

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
1	4,4'-Dichlorodiphenyltrichloroethane	50-29-3	Contains (regardless of intentional or impurities)	articles/ chemical products
2	Benzo(a)pyrene	50-32-8	Contains (regardless of intentional or impurities)	articles/ chemical products
3	Sodium o-(ethylmercurio)benzoate	54-64-8	Contains (regardless of intentional or impurities)	articles/ chemical products
4	Phenylmercuric nitrate	55-68-5	Contains (regardless of intentional or impurities)	articles/ chemical products
5	Carbon tetrachloride	56-23-5	Contains (regardless of intentional or impurities)	articles/ chemical products
6	Bis(tributyltin) oxide	56-35-9	Contains (regardless of intentional or impurities)	articles/ chemical products
7	Tributyltin acetate	56-36-0	Contains (regardless of intentional or impurities)	articles/ chemical products
8	Benzo(a)anthracene	56-55-3	Contains (regardless of intentional or impurities)	articles/ chemical products
9	Chlordane	57-74-9	Contains (regardless of intentional or impurities)	articles/ chemical products
10	Lindane	58-95-9	Contains (regardless of intentional or impurities)	articles/ chemical products
11	Benzenamine, 4-(phenylazo)-	60-08-9	Contains (regardless of intentional or impurities)	articles/ chemical products
12	Dieldrin	60-57-1	Contains (regardless of intentional or impurities)	articles/ chemical products
13	Phenylmercuric acetate	62-36-4	Contains (regardless of intentional or impurities)	articles/ chemical products
14	Diethyl sulfate	64-67-5	Contains (regardless of intentional or impurities)	articles/ chemical products
15	N,N-Dimethylformamide	68-12-2	Contains (regardless of intentional or impurities)	articles/ chemical products
16	Cobalt(II) acetate	71-48-7	Contains (regardless of intentional or impurities)	articles/ chemical products
17	Endrin	72-20-8	Contains (regardless of intentional or impurities)	articles/ chemical products
18	Formamide	75-12-7	Contains (regardless of intentional or impurities)	articles/ chemical products
19	Propylene oxide	75-56-9	Contains (regardless of intentional or impurities)	articles/ chemical products
20	Tetramethyllead	75-74-1	Contains (regardless of intentional or impurities)	articles/ chemical products
21	Heptachlor	76-44-8	Contains (regardless of intentional or impurities)	articles/ chemical products
22	Triphenyltin hydroxide	76-87-9	Contains (regardless of intentional or impurities)	articles/ chemical products
23	Phenolphthalein	77-09-8	Contains (regardless of intentional or impurities)	articles/ chemical products
24	4,4'-(1-Methylpropylidene)bisphenol	77-40-7	Intentional addition / 1,000ppm	articles/ chemical products
25	Dimethyl sulfate	77-78-1	Contains (regardless of intentional or impurities)	articles/ chemical products
26	Tetraethyllead	78-00-2	Contains (regardless of intentional or impurities)	articles/ chemical products
27	Trichloroethylene	79-01-6	Contains (regardless of intentional or impurities)	articles/ chemical products
28	Acrylamide	79-06-1	Contains (regardless of intentional or impurities)	articles/ chemical products
29	N-Methylacetamide	79-16-3	Contains (regardless of intentional or impurities)	articles/ chemical products
30	Bisphenol A	80-05-7	Contains (regardless of intentional or impurities)	articles/ chemical products
31	4-tert-Pentylphenol	80-46-6	Intentional addition / 1,000ppm	articles/ chemical products
32	Benzenepropanol, 4-(1,1-dimethylethyl)-.alpha.-methyl-	80-54-6	Intentional addition / 1ppm	articles/ chemical products
33	Musk xylene	81-15-2	Contains (regardless of intentional or impurities)	articles/ chemical products
34	1,2-Benzenedicarboxylic acid, dicyclohexyl ester	84-61-7	Contains (regardless of intentional or impurities)	articles/ chemical products
35	1,2-Benzenedicarboxylic acid, bis(2-methylpropyl) ester	84-69-5	Contains (regardless of intentional or impurities)	articles/ chemical products
36	Dibutyl phthalate	84-74-2	Contains (regardless of intentional or impurities)	articles/ chemical products
37	1,2-Benzenedicarboxylic acid, dihexyl ester	84-75-3	Contains (regardless of intentional or impurities)	articles/ chemical products
38	Phenanthrene	85-01-8	Contains (regardless of intentional or impurities)	articles/ chemical products
39	1,3-Isobenzofurandione, hexahydro-	85-42-7	Contains (regardless of intentional or impurities)	articles/ chemical products
40	1,2-Benzenedicarboxylic acid, butyl phenylmethyl ester	85-68-7	Contains (regardless of intentional or impurities)	articles/ chemical products
41	8-[3-Hydroxymercury-2-methoxypropyl]-3-carboxycoumarin	86-36-2	Contains (regardless of intentional or impurities)	articles/ chemical products
42	Mercury, methyl(8-quinolinolato-N1,O8)-	86-85-1	Contains (regardless of intentional or impurities)	articles/ chemical products
43	Hexachlorobutadiene	87-68-3	Contains (regardless of intentional or impurities)	articles/ chemical products
44	1-Hexadecanaminium, N,N,N-trimethyl-, salt with pentachlorophenol (1:1)	87-76-3	Contains (regardless of intentional or impurities)	articles/ chemical products
45	Pentachlorophenol	87-86-5	Contains (regardless of intentional or impurities)	articles/ chemical products
46	2-sec-Butyl-4,6-dinitrophenol	88-85-7	Contains (regardless of intentional or impurities)	articles/ chemical products
47	Mercury, chloro(2-hydroxyphenyl)-	90-03-9	Contains (regardless of intentional or impurities)	articles/ chemical products
48	Benzenamine, 2-methoxy-	90-04-0	Contains (regardless of intentional or impurities)	articles/ chemical products
49	Methanone, bis[4-(dimethylamino)phenyl]-	90-94-8	Contains (regardless of intentional or impurities)	articles/ chemical products
50	4-Aminobiphenyl	92-67-1	Contains (regardless of intentional or impurities)	articles/ chemical products
51	1,1'-Biphenyl, 4,4'-dibromo-	92-86-4	Contains (regardless of intentional or impurities)	articles/ chemical products
52	Benzoic acid, 4-hydroxy-, butyl ester	94-26-8	1,000ppm	articles/ chemical products
53	Phenylmercury benzoate	94-43-9	Contains (regardless of intentional or impurities)	articles/ chemical products
54	Benzenamine, 2-methyl-	95-53-4	Contains (regardless of intentional or impurities)	articles/ chemical products
55	Toluene-2,4-diamine	95-80-7	Contains (regardless of intentional or impurities)	articles/ chemical products
56	2,3-Dibromo-1-propanol	96-12-9	Contains (regardless of intentional or impurities)	articles/ chemical products
57	1,2,3-Trichloropropane	96-18-4	Contains (regardless of intentional or impurities)	articles/ chemical products
58	Ethylene thiourea	96-45-7	Contains (regardless of intentional or impurities)	articles/ chemical products
59	Benzenamine, 2-methyl-4-[(2-methylphenyl)azo]-	97-56-3	Contains (regardless of intentional or impurities)	articles/ chemical products
60	4-tert-Butylphenol	98-54-4	Contains (regardless of intentional or impurities)	articles/ chemical products
61	Nitrobenzene	98-95-3	Contains (regardless of intentional or impurities)	articles/ chemical products
62	Phenylmercury chloride	100-58-1	Contains (regardless of intentional or impurities)	articles/ chemical products
63	Phenylmercuric hydroxide	100-57-2	Contains (regardless of intentional or impurities)	articles/ chemical products
64	4,4'-Methylenebis(2-chloroaniline)	101-14-4	Contains (regardless of intentional or impurities)	articles/ chemical products
65	Benzenamine, 4,4'-methylenebis(N,N-dimethyl)-	101-61-1	Contains (regardless of intentional or impurities)	articles/ chemical products
66	4,4'-Methylenedianiline	101-77-9	Contains (regardless of intentional or impurities)	articles/ chemical products
67	Benzenamine, 4,4'-oxybis-	101-80-4	Contains (regardless of intentional or impurities)	articles/ chemical products
68	Mercury, phenyl(propanoato-O)-	103-27-5	Contains (regardless of intentional or impurities)	articles/ chemical products
69	Ethanol, 2-(4-nonylphenoxy)-	104-35-8	1,000ppm	articles/ chemical products
70	4-Nonylphenol	104-40-5	Contains (regardless of intentional or impurities)	articles/ chemical products
71	Phenylmercury stearate	104-59-6	Contains (regardless of intentional or impurities)	articles/ chemical products
72	Mercury, (9-octadecenoato-O)phenyl-, (Z)-	104-60-9	Contains (regardless of intentional or impurities)	articles/ chemical products
73	1-Bromopropane	106-94-5	Contains (regardless of intentional or impurities)	articles/ chemical products
74	1,2-Dichloroethane	107-06-2	Contains (regardless of intentional or impurities)	articles/ chemical products
75	Ethylenediamine	107-15-3	Contains (regardless of intentional or impurities)	articles/ chemical products
76	Bromomethylmercury	107-26-6	Contains (regardless of intentional or impurities)	articles/ chemical products
77	Ethylmercuric chloride	107-27-7	Contains (regardless of intentional or impurities)	articles/ chemical products
78	(Acetato-O)methylmercury	108-07-6	Contains (regardless of intentional or impurities)	articles/ chemical products
79	(acetato-O)ethylmercury	109-62-6	Contains (regardless of intentional or impurities)	articles/ chemical products
80	2-Methoxyethanol	109-86-4	Contains (regardless of intentional or impurities)	articles/ chemical products
81	Furan	110-00-9	Contains (regardless of intentional or impurities)	articles/ chemical products
82	Ethanol, 2-methoxy-, acetate	110-49-6	Contains (regardless of intentional or impurities)	articles/ chemical products
83	Ethylene glycol dimethyl ether	110-71-4	Contains (regardless of intentional or impurities)	articles/ chemical products
84	2-Ethoxyethanol	110-80-5	Contains (regardless of intentional or impurities)	articles/ chemical products
85	2-Ethoxyethyl acetate	111-15-9	Contains (regardless of intentional or impurities)	articles/ chemical products
86	Glutaraldehyde	111-30-8	Contains (regardless of intentional or impurities)	articles/ chemical products
87	Diethylene glycol dimethyl ether	111-96-6	Contains (regardless of intentional or impurities)	articles/ chemical products
88	Triethylene glycol dimethyl ether	112-49-2	Contains (regardless of intentional or impurities)	articles/ chemical products
89	Mercurymethylchloride	115-09-3	Contains (regardless of intentional or impurities)	articles/ chemical products
90	Endosulfan	115-29-7	Contains (regardless of intentional or impurities)	articles/ chemical products
91	Dicofol	115-32-2	Contains (regardless of intentional or impurities)	articles/ chemical products
92	Ethanol, 2-chloro-, phosphate (3:1)	115-96-8	Contains (regardless of intentional or impurities)	articles/ chemical products
93	Bis(2-ethylhexyl) phthalate	117-81-7	Contains (regardless of intentional or impurities)	articles/ chemical products
94	Bis(2-methoxyethyl) phthalate	117-82-8	Contains (regardless of intentional or impurities)	articles/ chemical products
95	Hexachlorobenzene	118-74-1	Contains (regardless of intentional or impurities)	articles/ chemical products
96	2,2'-Methylenebis(4-methyl-6-tert-butylphenol)	119-47-1	1,000ppm	articles/ chemical products
97	Anthracene	120-12-7	Contains (regardless of intentional or impurities)	articles/ chemical products
98	Benzenamine, 2-methoxy-5-methyl-	120-71-8	Contains (regardless of intentional or impurities)	articles/ chemical products
99	2,4-Dinitrotoluene	121-14-2	Contains (regardless of intentional or impurities)	articles/ chemical products
100	Lactophenylmercury	122-64-5	Contains (regardless of intentional or impurities)	articles/ chemical products
101	Diazenedicarboxamide	123-72-3	Contains (regardless of intentional or impurities)	articles/ chemical products
102	2-Methoxyethylmercury chloride	123-88-6	Contains (regardless of intentional or impurities)	articles/ chemical products
103	1,4-Dioxane	123-91-1	Contains (regardless of intentional or impurities)	articles/ chemical products
104	2-ethoxyethylmercury chloride	124-01-6	Contains (regardless of intentional or impurities)	articles/ chemical products
105	2-ethoxyethylmercury acetate	124-08-3	Contains (regardless of intentional or impurities)	articles/ chemical products
106	Tetrachloroethylene	127-18-4	Contains (regardless of intentional or impurities)	articles/ chemical products
107	N,N-Dimethylacetamide	127-19-5	Contains (regardless of intentional or impurities)	articles/ chemical products
108	1,2,3,4,10,10-Hexachloro-6,7-epoxy-1,4,4a,5,6,7,8,8a-octahydro-1,4,5,8-dimethanonaphthalene	128-10-9	Contains (regardless of intentional or impurities)	articles/ chemical products
109	Pyrene	129-00-0	Contains (regardless of intentional or impurities)	articles/ chemical products
110	Mercury, (2,7'-dibromo-3',6'-dihydroxy-3-oxospiro[isobenzofuran-1(3H),9'-[9H]xanthen]-4'-yl)hydroxy-, disodium salt	129-16-8	Contains (regardless of intentional or impurities)	articles/ chemical products
111	Di-n-pentyl phthalate	131-18-0	Contains (regardless of intentional or impurities)	articles/ chemical products
112	Phenol, 2,3,4,5,6-pentachloro-, sodium salt (1:1)	131-52-2	Contains (regardless of intentional or impurities)	articles/ chemical products
113	Phenol, 4-(1,1,3,3-tetramethylbutyl)-	140-66-9	Contains (regardless of intentional or impurities)	articles/ chemical products
114	Mercury, iodo(iodomethyl)-	141-51-5	Contains (regardless of intentional or impurities)	articles/ chemical products
115	2,5,8,11,14-Pentaoxapentadecane	143-24-8	1,000ppm	articles/ chemical products
116	Iodomethylmercury	143-36-2	Contains (regardless of intentional or impurities)	articles/ chemical products
117	Kepon	143-50-0	Contains (regardless of intentional or impurities)	articles/ chemical products
118	Methoxyethylmercuric acetate	151-38-2	Contains (regardless of intentional or impurities)	articles/ chemical products
119	Benzo(ghi)perylene	191-24-2	Intentional addition / 1,000ppm	articles/ chemical products
120	Fluoranthene	206-44-0	Contains (regardless of intentional or impurities)	articles/ chemical products
121	Benzo(k)fluoranthene	207-08-9	Contains (regardless of intentional or impurities)	articles/ chemical products
122	Chrysene	218-01-9	Contains (regardless of intentional or impurities)	articles/ chemical products
123	Acetic acid, lead(2+) salt	301-04-2	Contains (regardless of intentional or impurities)	articles/ chemical products
124	Hexanoic acid, 2-ethyl-, lead(2+) salt	301-08-6	Contains (regardless of intentional or impurities)	articles/ chemical products
125	Hydrazine	302-01-2	Contains (regardless of intentional or impurities)	articles/ chemical products
126	Mercury, bromo[2-(hydroxymethyl)phenyl]-	304-90-5	Contains (regardless of intentional or impurities)	articles/ chemical products
127	1-Octanesulfonyl fluoride, 1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-heptadecafluoro-	307-35-7	Contains (regardless of intentional or impurities)	articles/ chemical products
128	Dodecanoic acid, tricosafuoro-	307-55-1	Contains (regardless of intentional or impurities)	articles/ chemical products
129	Aldrin	309-00-2	Contains (regardless of intentional or impurities)	articles/ chemical products
130	alpha-Hexachlorocyclohexane	319-84-6	Contains (regardless of intentional or impurities)	articles/ chemical products
131	beta-BHC	319-85-7	Contains (regardless of intentional or impurities)	articles/ chemical products
132	Octanoic acid, pentadecafluoro-	335-67-1	Contains (regardless of intentional or impurities)	articles/ chemical products
133	Decanoic acid, nonadecafluoro-	335-76-2	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
134	Octanoic acid, pentadecafluoro-, silver(1+) salt	335-93-3	Contains (regardless of intentional or impurities)	articles/ chemical products
135	Octanoic acid, pentadecafluoro-, sodium salt	335-95-5	Contains (regardless of intentional or impurities)	articles/ chemical products
136	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-	355-46-4	Contains (regardless of intentional or impurities)	articles/ chemical products
137	Bis(trifluoromethyl) mercury	371-76-6	Contains (regardless of intentional or impurities)	articles/ chemical products
138	Nonanoic acid, heptadecafluoro-	375-95-1	Contains (regardless of intentional or impurities)	articles/ chemical products
139	Tetradecanoic acid, heptacosafuoro-	376-06-7	Contains (regardless of intentional or impurities)	articles/ chemical products
141	Stannane, fluorotriphenyl-	379-52-2	Contains (regardless of intentional or impurities)	articles/ chemical products
141	Bromomethylmercury	506-63-2	Contains (regardless of intentional or impurities)	articles/ chemical products
142	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, lead(2+) salt (2:3)	512-26-5	Contains (regardless of intentional or impurities)	articles/ chemical products
143	Cadmium carbonate	513-78-0	Contains (regardless of intentional or impurities)	articles/ chemical products
144	Carbonic acid, cobalt(2+) salt (1:1)	513-78-1	Contains (regardless of intentional or impurities)	articles/ chemical products
145	N-(Ethylmercurio)toluene-4-sulphonilide	517-16-6	Contains (regardless of intentional or impurities)	articles/ chemical products
146	Mercury, bis(4-methylphenyl)-	537-64-4	Contains (regardless of intentional or impurities)	articles/ chemical products
147	Phenol, 2-chloro-, mercury complex	538-04-5	Contains (regardless of intentional or impurities)	articles/ chemical products
148	Mercury, chloro(4-methylphenyl)-	539-43-5	Contains (regardless of intentional or impurities)	articles/ chemical products
149	Dodecamethylcyclohexasiloxane	540-97-6	Intentional addition / 1,000ppm	articles/ chemical products
150	Decamethylcyclopentasiloxane	541-02-6	Intentional addition / 1,000ppm	articles/ chemical products
151	Butylmercuric(2+) chloride	543-63-5	Contains (regardless of intentional or impurities)	articles/ chemical products
152	C.I. Basic Violet 3	548-62-9	Contains (regardless of intentional or impurities)	articles/ chemical products
153	Trimellitic anhydride	552-30-7	Contains (regardless of intentional or impurities)	articles/ chemical products
154	Octamethylcyclotetrasiloxane	556-67-2	Contains (regardless of intentional or impurities)	articles/ chemical products
155	4,4'-Bis(dimethylamino)-4''-(methylamino)trityl alcohol	561-41-1	Intentional addition / 1,000ppm	articles/ chemical products
156	C.I. Direct red 28	573-58-0	Contains (regardless of intentional or impurities)	articles/ chemical products
157	Mercuric benzoate	583-19-3	Contains (regardless of intentional or impurities)	articles/ chemical products
158	2-hydroxy-5-(1,1,3,3-tetramethylbutyl)phenylmercury acetate	584-18-9	Contains (regardless of intentional or impurities)	articles/ chemical products
159	Disuccinimidomercurey	584-43-0	Contains (regardless of intentional or impurities)	articles/ chemical products
160	Diphenylmercury	587-85-9	Contains (regardless of intentional or impurities)	articles/ chemical products
161	Mercury succinate	589-65-1	Contains (regardless of intentional or impurities)	articles/ chemical products
162	Mercury cyanide (Hg(CN)2)	592-04-1	Contains (regardless of intentional or impurities)	articles/ chemical products
163	Lead(2+) cyanide	592-05-2	Contains (regardless of intentional or impurities)	articles/ chemical products
164	Mercury acetates	592-63-2	Contains (regardless of intentional or impurities)	articles/ chemical products
165	Thiocyanic acid, mercury(2+) salt	592-85-8	Contains (regardless of intentional or impurities)	articles/ chemical products
166	Lead thiocyanate	592-87-0	Contains (regardless of intentional or impurities)	articles/ chemical products
167	Dimethylmercury	593-74-8	Contains (regardless of intentional or impurities)	articles/ chemical products
168	Tetraphenyllead	595-89-1	Contains (regardless of intentional or impurities)	articles/ chemical products
169	Carbonic acid, lead(2+) salt (1:1)	598-63-0	Contains (regardless of intentional or impurities)	articles/ chemical products
170	Diisopentyl phthalate	605-50-5	Contains (regardless of intentional or impurities)	articles/ chemical products
171	Pentachlorobenzene	608-93-5	Contains (regardless of intentional or impurities)	articles/ chemical products
172	Di- <i>o</i> -tolylmercury	616-99-9	Contains (regardless of intentional or impurities)	articles/ chemical products
173	1,4-Benzenediamine, N,N'-bis(4-methylphenyl)-	620-91-7	Contains (regardless of intentional or impurities)	articles/ chemical products
174	Mercury, chloro(4-hydroxyphenyl)-	623-07-4	Contains (regardless of intentional or impurities)	articles/ chemical products
175	Acetic acid, methoxy-	625-45-6	Contains (regardless of intentional or impurities)	articles/ chemical products
176	Diethylmercury	627-44-1	Contains (regardless of intentional or impurities)	articles/ chemical products
177	Dipropylmercury	628-85-3	Contains (regardless of intentional or impurities)	articles/ chemical products
178	Ethylene glycol diethyl ether	629-14-1	Contains (regardless of intentional or impurities)	articles/ chemical products
179	Mercury, dibutyl-	629-35-6	Contains (regardless of intentional or impurities)	articles/ chemical products
180	Acetic acid, mercury(1+) salt	631-60-7	Contains (regardless of intentional or impurities)	articles/ chemical products
181	Stannane, chlorotriphenyl-	639-58-7	Contains (regardless of intentional or impurities)	articles/ chemical products
182	Mercury distearate, pure	645-99-8	Contains (regardless of intentional or impurities)	articles/ chemical products
183	Dibutyltin dichloride	683-18-1	Contains (regardless of intentional or impurities)	articles/ chemical products
184	Di- <i>sec</i> -butylmercury	691-88-3	Contains (regardless of intentional or impurities)	articles/ chemical products
185	2-Methylimidazole	693-98-1	Contains (regardless of intentional or impurities)	articles/ chemical products
186	2,4,6-Tri- <i>tert</i> -butylphenol	732-26-3	Contains (regardless of intentional or impurities)	articles/ chemical products
187	Dibenzylmercury	780-54-5	Contains (regardless of intentional or impurities)	articles/ chemical products
188	Lead formate	811-54-1	Contains (regardless of intentional or impurities)	articles/ chemical products
189	Lead dipropionate	814-70-0	Contains (regardless of intentional or impurities)	articles/ chemical products
190	Ethanedioic acid, lead(2+) salt (1:1)	814-93-7	Contains (regardless of intentional or impurities)	articles/ chemical products
191	Butanedioic acid, 2,3-dihydroxy-[R-(R*,R*)]-, lead(2+) salt (1:1)	815-84-6	Contains (regardless of intentional or impurities)	articles/ chemical products
192	Lead malate	816-68-2	Contains (regardless of intentional or impurities)	articles/ chemical products
193	Lead dibutylate	819-73-6	Contains (regardless of intentional or impurities)	articles/ chemical products
194	Mercury, iodophenyl-	823-04-1	Contains (regardless of intentional or impurities)	articles/ chemical products
195	Benzenesulfonic acid, 4-hydroxy-, lead(2+) salt (2:1)	825-91-2	Contains (regardless of intentional or impurities)	articles/ chemical products
196	4,4'-Methylenebis(2-methylaniline)	838-88-0	Contains (regardless of intentional or impurities)	articles/ chemical products
197	Lead(2+) acrylate	867-47-0	Contains (regardless of intentional or impurities)	articles/ chemical products
198	1-Methyl-2-pyrrolidone	872-50-4	Contains (regardless of intentional or impurities)	articles/ chemical products
199	Lead dibenzoate	873-54-1	Contains (regardless of intentional or impurities)	articles/ chemical products
200	Stannane, acetoxytriphenyl-	900-95-8	Contains (regardless of intentional or impurities)	articles/ chemical products
201	alpha-Endosulfan	958-98-8	Contains (regardless of intentional or impurities)	articles/ chemical products
202	Bis(pentafluorophenyl)mercury	973-17-1	Contains (regardless of intentional or impurities)	articles/ chemical products
203	Vinyltris(methoxyethoxy)silane	1067-53-4	1,000ppm	articles/ chemical products
204	Lead methacrylate	1068-61-7	Contains (regardless of intentional or impurities)	articles/ chemical products
205	Diisopropylmercury	1071-39-2	Contains (regardless of intentional or impurities)	articles/ chemical products
206	1H-Imidazole, 1-ethenyl-	1072-63-5	10ppm	articles/ chemical products
207	9-Octadecenoic acid (9Z)-, lead(2+) salt (2:1)	1120-46-3	Contains (regardless of intentional or impurities)	articles/ chemical products
208	1,3-Propane sultone	1120-71-4	Contains (regardless of intentional or impurities)	articles/ chemical products
209	Mercury, (pentachlorophenoxy)phenyl-	1142-64-9	Contains (regardless of intentional or impurities)	articles/ chemical products
210	Decabromodiphenyl oxide	1163-19-5	Contains (regardless of intentional or impurities)	articles/ chemical products
211	Methylmercury hydroxide	1184-57-2	Contains (regardless of intentional or impurities)	articles/ chemical products
212	Lead succinate	1191-18-0	Contains (regardless of intentional or impurities)	articles/ chemical products
213	Mercury oleate	1191-80-6	Contains (regardless of intentional or impurities)	articles/ chemical products
214	Bromophenylmercury	1192-89-8	Contains (regardless of intentional or impurities)	articles/ chemical products
215	Tolylmercury acetate	1300-78-3	Contains (regardless of intentional or impurities)	articles/ chemical products
216	Arsenic pentoxide	1303-28-2	Contains (regardless of intentional or impurities)	articles/ chemical products
217	Boron oxide (B2O3)	1303-86-2	Contains (regardless of intentional or impurities)	articles/ chemical products
218	Borax (B4Na2O7.10H2O)	1303-96-4	Contains (regardless of intentional or impurities)	articles/ chemical products
219	Cadmium oxide (CdO)	1306-19-0	Contains (regardless of intentional or impurities)	articles/ chemical products
220	Cadmium sulfide	1306-23-6	Contains (regardless of intentional or impurities)	articles/ chemical products
221	Lead oxide (PbO2)	1309-60-0	Contains (regardless of intentional or impurities)	articles/ chemical products
222	Lead(II) hexafluorosilicate dihydrate	1310-03-8	Contains (regardless of intentional or impurities)	articles/ chemical products
223	Dimercury amidatenitrate	1310-88-9	Contains (regardless of intentional or impurities)	articles/ chemical products
224	Lead hydroxide	1311-11-1	Contains (regardless of intentional or impurities)	articles/ chemical products
225	Mercuric subsulfate	1312-03-4	Contains (regardless of intentional or impurities)	articles/ chemical products
226	Lead oxide (Pb2O3)	1314-27-8	Contains (regardless of intentional or impurities)	articles/ chemical products
227	Lead oxide (Pb3O4)	1314-41-6	Contains (regardless of intentional or impurities)	articles/ chemical products
228	Lead telluride	1314-91-6	Contains (regardless of intentional or impurities)	articles/ chemical products
229	Lead oxide (PbO)	1317-36-8	Contains (regardless of intentional or impurities)	articles/ chemical products
231	Lead, bis(carbonato(2-))dihydroxytri-	1319-46-6	Contains (regardless of intentional or impurities)	articles/ chemical products
231	Chloromethoxy(propyl)mercury acetate	1319-86-4	Contains (regardless of intentional or impurities)	articles/ chemical products
232	Chloro(hydroxyphenyl)mercury	1320-80-5	Contains (regardless of intentional or impurities)	articles/ chemical products
232	Pentachloronaphthalene	1321-64-8	Contains (regardless of intentional or impurities)	articles/ chemical products
234	Trichloronaphthalene	1321-65-9	Contains (regardless of intentional or impurities)	articles/ chemical products
235	Spiro(isobenzofuran-1(3H),9-[9H]xanthen)-3-one, 2',4',5',7'-tetrabromo-3',6'-dihydroxy-, lead salt	1326-05-2	Contains (regardless of intentional or impurities)	articles/ chemical products
236	Lead arsenate, basic	1327-31-7	Contains (regardless of intentional or impurities)	articles/ chemical products
237	Arsenic oxide (As2O3)	1327-53-3	Contains (regardless of intentional or impurities)	articles/ chemical products
238	Disodium tetraborate	1330-43-4	Contains (regardless of intentional or impurities)	articles/ chemical products
239	Boric acid, sodium salt	1333-73-9	1%	articles/ chemical products
240	Chromium trioxide	1333-82-0	Contains (regardless of intentional or impurities)	articles/ chemical products
241	Lead oxides	1335-25-7	Contains (regardless of intentional or impurities)	articles/ chemical products
242	Mercuric oxycyanide	1335-31-5	Contains (regardless of intentional or impurities)	articles/ chemical products
243	Lead subacetate	1335-32-6	Contains (regardless of intentional or impurities)	articles/ chemical products
244	Hexachloronaphthalene	1335-87-1	Contains (regardless of intentional or impurities)	articles/ chemical products
245	Tetrachloronaphthalene	1335-88-2	Contains (regardless of intentional or impurities)	articles/ chemical products
246	1,1'-Biphenyl, chloro derivatives	1336-36-3	Contains (regardless of intentional or impurities)	articles/ chemical products
247	Naphthenic acids, mercury salts	1336-96-5	Contains (regardless of intentional or impurities)	articles/ chemical products
248	C.I. Pigment Yellow 34	1344-36-1	Intentional addition / 1,000ppm	articles/ chemical products
249	C.I. Pigment Yellow 34	1344-37-2	Contains (regardless of intentional or impurities)	articles/ chemical products
250	Lead oxide phosphonate, hemihydrate	1344-40-7	Contains (regardless of intentional or impurities)	articles/ chemical products
251	Mercury sulfide (HgS)	1344-48-5	Contains (regardless of intentional or impurities)	articles/ chemical products
252	Tributyltin chloride	1461-22-9	Contains (regardless of intentional or impurities)	articles/ chemical products
253	1-Propanol, 3-bromo-2,2-bis(bromomethyl)-	1522-92-5	1,000ppm	articles/ chemical products
254	Acetic acid, mercury(2+) salt (2:1)	1600-27-7	Contains (regardless of intentional or impurities)	articles/ chemical products
255	Pyrene-d10	1718-52-1	Intentional addition / 1,000ppm	articles/ chemical products
256	Benz[a]anthracene-d12	1718-53-2	Intentional addition / 1,000ppm	articles/ chemical products
257	Chrysenes-d12	1719-03-5	Intentional addition / 1,000ppm	articles/ chemical products
258	Plumbane, ethyltrimethyl-	1762-26-1	Contains (regardless of intentional or impurities)	articles/ chemical products
259	Plumbane, diethyldimethyl-	1762-27-2	Contains (regardless of intentional or impurities)	articles/ chemical products
260	Plumbane, triethylmethyl-	1762-28-3	Contains (regardless of intentional or impurities)	articles/ chemical products
261	Perfluorooctanesulfonic acid	1763-23-1	Contains (regardless of intentional or impurities)	articles/ chemical products
262	Mercury, chloro(ethanethiolato)-	1785-43-9	Contains (regardless of intentional or impurities)	articles/ chemical products
263	Triphenyltin dimethyldithiocarbamate	1803-12-9	Contains (regardless of intentional or impurities)	articles/ chemical products
264	Naphthalene, 1,5-dichloro-	1825-30-5	Contains (regardless of intentional or impurities)	articles/ chemical products
265	Naphthalene, 1,4-dichloro-	1825-31-6	Contains (regardless of intentional or impurities)	articles/ chemical products
266	Plumbane, tetrabutyl-	1920-90-7	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
267	C.1 Direct Black 38	1937-37-7	Contains (regardless of intentional or impurities)	articles/ chemical products
268	Stannane, tributylfluoro-	1983-10-4	Contains (regardless of intentional or impurities)	articles/ chemical products
269	Phenol, 4-heptyl-	1987-50-4	Intentional addition / 1,000ppm	articles/ chemical products
270	3,3'-dichlorobiphenyl	2050-67-1	Contains (regardless of intentional or impurities)	articles/ chemical products
271	4,4'-dichlorobiphenyl	2050-68-2	Contains (regardless of intentional or impurities)	articles/ chemical products
272	Naphthalene, 1,2-dichloro-	2050-69-3	Contains (regardless of intentional or impurities)	articles/ chemical products
273	Naphthalene, 1,6-dichloro-	2050-72-8	Contains (regardless of intentional or impurities)	articles/ chemical products
274	Naphthalene, 1,7-dichloro-	2050-73-9	Contains (regardless of intentional or impurities)	articles/ chemical products
275	Naphthalene, 2,8-dichloro-	2050-74-0	Contains (regardless of intentional or impurities)	articles/ chemical products
276	Naphthalene, 1,3-dichloro-	2050-75-1	Contains (regardless of intentional or impurities)	articles/ chemical products
277	Decachloro, 1,1'-biphenyl	2051-24-3	Contains (regardless of intentional or impurities)	articles/ chemical products
278	2-chlorobiphenyl	2051-60-7	Contains (regardless of intentional or impurities)	articles/ chemical products
279	3-chlorobiphenyl	2051-61-8	Contains (regardless of intentional or impurities)	articles/ chemical products
280	4-chlorobiphenyl	2051-62-9	Contains (regardless of intentional or impurities)	articles/ chemical products
281	Hexafluoroisobutanoic acid	2058-94-8	Intentional addition / 1,000ppm	articles/ chemical products
282	Propanoic fluoride, 2,3,3,3-tetrafluoro-2-(heptafluoropropoxy)-	2062-98-8	Intentional addition / 1,000ppm	articles/ chemical products
283	Naphthalene, 2,6-dichloro-	2065-70-5	Contains (regardless of intentional or impurities)	articles/ chemical products
284	Diphenyllead dichloride	2117-69-3	Contains (regardless of intentional or impurities)	articles/ chemical products
285	2,2',3,3',5,5',6,6'-octachlorobiphenyl	2136-99-4	Contains (regardless of intentional or impurities)	articles/ chemical products
286	Tributyltin thiacrylate	2155-70-6	Contains (regardless of intentional or impurities)	articles/ chemical products
287	Naphthalene, 1,3-dichloro-	2198-75-6	Contains (regardless of intentional or impurities)	articles/ chemical products
288	Naphthalene, 2,7-dichloro-	2198-77-8	Contains (regardless of intentional or impurities)	articles/ chemical products
289	Octachloronaphthalene	2234-13-1	Contains (regardless of intentional or impurities)	articles/ chemical products
290	Ethylmercuric phosphate	2235-25-8	Contains (regardless of intentional or impurities)	articles/ chemical products
291	4-tert-Octylphenol diethoxylate	2315-61-9	Intentional addition / 1,000ppm	articles/ chemical products
292	2-(4-tert-Octylphenoxy)ethanol	2315-67-5	Intentional addition / 1,000ppm	articles/ chemical products
293	Mirex	2385-85-5	Contains (regardless of intentional or impurities)	articles/ chemical products
294	Potassium perfluorooctanoate	2395-00-8	Intentional addition / 0.025ppm	articles/ chemical products
295	1,4,6-Trichloronaphthalene	2437-54-9	Contains (regardless of intentional or impurities)	articles/ chemical products
296	1,4,5-Trichloronaphthalene	2437-55-0	Contains (regardless of intentional or impurities)	articles/ chemical products
297	2,2',4,4'-tetrachlorobiphenyl	2437-79-8	Contains (regardless of intentional or impurities)	articles/ chemical products
298	Mercury, (butyrate)phenyl-	2440-29-1	Contains (regardless of intentional or impurities)	articles/ chemical products
299	4-Methyl-N-phenyl-N-phenylmercurybenzenesulfonamide	2440-34-8	Contains (regardless of intentional or impurities)	articles/ chemical products
300	Chloropropylmercury(2+)	2440-40-6	Contains (regardless of intentional or impurities)	articles/ chemical products
301	Ethylodomercury	2440-42-8	Contains (regardless of intentional or impurities)	articles/ chemical products
302	Bis(ethylmercury) hydrogen phosphate	2440-45-1	Contains (regardless of intentional or impurities)	articles/ chemical products
303	1,3,5-Triazine-2,4,6-(1H,3H,5H)-trione, 1,3,5-tris(oxiranylmethyl)-	2451-62-9	Contains (regardless of intentional or impurities)	articles/ chemical products
304	20-[4-(1,1,3,3-tetramethylbutyl)phenoxy]-3,6,9,12,15,18-hexaoxaicosan-1-ol	2497-59-8	Intentional addition / 1,000ppm	articles/ chemical products
305	Lead chromate	2508-97-6	Contains (regardless of intentional or impurities)	articles/ chemical products
306	Methanaminium, N-[4-[[4-(dimethylamino)phenyl][4-(phenylamino)-1-naphthalenyl(methylene)-2,5-cyclohexadien-1-ylidene]-N-methyl-, chloride	2580-56-5	Intentional addition / 100ppm	articles/ chemical products
307	Dibutyllead acetate	2587-84-0	Contains (regardless of intentional or impurities)	articles/ chemical products
308	Ethylmercury 2,3-dihydroxypropyl mercaptide	2597-92-4	Contains (regardless of intentional or impurities)	articles/ chemical products
309	Methylmercury 2,3-dihydroxypropyl mercaptide	2597-95-7	Contains (regardless of intentional or impurities)	articles/ chemical products
310	(Cyano-C)methyl mercury	2597-97-9	Contains (regardless of intentional or impurities)	articles/ chemical products
311	Mercury, ethyl(4-methylbenzenesulfonato)-	2654-47-9	Contains (regardless of intentional or impurities)	articles/ chemical products
312	(maleoyldioxy)bis(phenylmercury)	2701-61-3	Contains (regardless of intentional or impurities)	articles/ chemical products
313	Chloro-o-tolylmercury	2777-37-9	Contains (regardless of intentional or impurities)	articles/ chemical products
314	1-Octanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-heptafluoro-, potassium salt	2795-39-3	Contains (regardless of intentional or impurities)	articles/ chemical products
315	Pentachlorophenol copper salt	2917-31-9	Contains (regardless of intentional or impurities)	articles/ chemical products
316	Zinc bis(pentachlorophenolate)	2917-32-0	Contains (regardless of intentional or impurities)	articles/ chemical products
317	Mercury(1+) trifluoroacetate	2923-11-3	Contains (regardless of intentional or impurities)	articles/ chemical products
318	Dimercury(D) oxalate	2949-11-3	Contains (regardless of intentional or impurities)	articles/ chemical products
319	3,4'-dichlorobiphenyl	2974-80-5	Contains (regardless of intentional or impurities)	articles/ chemical products
320	3,4-dichlorobiphenyl	2974-82-7	Contains (regardless of intentional or impurities)	articles/ chemical products
321	Mercury(2+) cyanate	3021-39-4	Contains (regardless of intentional or impurities)	articles/ chemical products
322	Phenol, 4-(nonyl)- phosphite (3:1)	3050-88-2	Intentional addition / 1,000ppm	articles/ chemical products
323	Chloro-[[2-hydroxy-1-naphthyl(azo)phenyl]mercury	3076-91-3	Contains (regardless of intentional or impurities)	articles/ chemical products
324	Tributyl(auroyloxy)stannane	3090-38-6	Contains (regardless of intentional or impurities)	articles/ chemical products
325	ammonium nonadecafluorodecanate	3108-42-7	Contains (regardless of intentional or impurities)	articles/ chemical products
326	1,2,5,6,9,10-Hexabromocyclohexadecane	3194-55-6	Contains (regardless of intentional or impurities)	articles/ chemical products
327	p-tert-Butylbenzoic acid lead salt	3249-60-3	Contains (regardless of intentional or impurities)	articles/ chemical products
328	Docosanoic acid, lead salt	3249-61-4	Contains (regardless of intentional or impurities)	articles/ chemical products
329	Mercury, phenyl(trichloromethyl)-	3294-57-3	Contains (regardless of intentional or impurities)	articles/ chemical products
330	(bromodichloromethyl)phenylmercury	3294-58-4	Contains (regardless of intentional or impurities)	articles/ chemical products
331	Phenyl(tribromomethyl)mercury	3294-60-8	Contains (regardless of intentional or impurities)	articles/ chemical products
332	2-Bis(bromomethyl)-1,3-propanediol	3296-90-0	Contains (regardless of intentional or impurities)	articles/ chemical products
333	Mercury, chloro(3-(2,4-dioxo-1-methyl-3-imidazolindyl)-2-methoxy)propyl-	3367-28-0	Contains (regardless of intentional or impurities)	articles/ chemical products
334	Mercury, chloro(3-(2,4-dioxo-3-imidazolindyl)-2-methoxy)propyl-	3367-29-1	Contains (regardless of intentional or impurities)	articles/ chemical products
335	Mercury, chloro(3-(2,4-dioxo-3-methyl-5-imidazolindyl)-2-methoxy)propyl-	3367-30-4	Contains (regardless of intentional or impurities)	articles/ chemical products
336	Mercury, chloro(3-(2,4-dioxo-5-imidazolindyl)-2-methoxy)propyl-	3367-31-5	Contains (regardless of intentional or impurities)	articles/ chemical products
337	Mercury, chloro(3-(2,4-dioxo-1-imidazolindyl)-2-methoxy)propyl-	3367-32-6	Contains (regardless of intentional or impurities)	articles/ chemical products
338	1,4,5,8-Tetrachloronaphthalene	3432-57-3	Contains (regardless of intentional or impurities)	articles/ chemical products
339	Tetrapropyl lead	3440-75-3	Contains (regardless of intentional or impurities)	articles/ chemical products
340	Mercury(II) oxalate	3444-13-1	Contains (regardless of intentional or impurities)	articles/ chemical products
341	Mercury, chloro(3-(5,5-dimethyl-2,4-dioxo-3-imidazolindyl)-2-methoxy)propyl-	3477-28-9	Contains (regardless of intentional or impurities)	articles/ chemical products
342	Fluorescein mercuric acetate	3570-80-7	Contains (regardless of intentional or impurities)	articles/ chemical products
343	Methylmercury benzoate	3626-13-9	Contains (regardless of intentional or impurities)	articles/ chemical products
344	Tributyl(pentachlorophenoxy)stannane	3644-38-0	Contains (regardless of intentional or impurities)	articles/ chemical products
345	Stannane, diocetyl(bis(1-oxododecyl)oxy)-	3648-18-8	Contains (regardless of intentional or impurities)	articles/ chemical products
346	Arsenic acid (H3AsO4), lead(2+) salt (2:3)	3687-31-8	Contains (regardless of intentional or impurities)	articles/ chemical products
347	Mercury, (1,2-benzenediolato-O)phenyl-	3688-11-7	Contains (regardless of intentional or impurities)	articles/ chemical products
348	Pentachlorophenyl laurate	3772-94-9	Contains (regardless of intentional or impurities)	articles/ chemical products
349	Bis(methylmercuric) sulfate	3810-81-9	Contains (regardless of intentional or impurities)	articles/ chemical products
350	Ammonium perfluorooctanoate	3825-26-1	Contains (regardless of intentional or impurities)	articles/ chemical products
351	Decanoic acid, nonadecafluoro-, sodium salt	3830-45-3	Contains (regardless of intentional or impurities)	articles/ chemical products
352	Phenol, 2-(2H-benzotriazol-2-yl)-4,6-bis(1,1-dimethylethyl)-	3846-71-7	Contains (regardless of intentional or impurities)	articles/ chemical products
353	Phenol, 2-(5-chloro-2H-benzotriazol-2-yl)-4,6-bis(1,1-dimethylethyl)-	3864-99-1	Intentional addition / 100ppm	articles/ chemical products
354	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, potassium salt	3871-99-6	Contains (regardless of intentional or impurities)	articles/ chemical products
355	Sodium perfluorooctanesulfonate	4021-47-0	Contains (regardless of intentional or impurities)	articles/ chemical products
356	Nonanoic acid, heptafluoro-, ammonium salt	4149-60-4	Contains (regardless of intentional or impurities)	articles/ chemical products
357	Mercury, bis(2-oxoethyl)-	4387-13-7	Contains (regardless of intentional or impurities)	articles/ chemical products
358	Cyclododecane, 1,2,5,6,9,10-hexabromo-, (1R*,2S*,5R*,6S*,9R*,10S*)-	4736-49-6	Contains (regardless of intentional or impurities)	articles/ chemical products
359	[P(hthalylbis(oxyl)bis(tributylstannane)]	4782-29-0	Contains (regardless of intentional or impurities)	articles/ chemical products
360	Triphenyl(phenylethynyl)lead	5072-98-0	Contains (regardless of intentional or impurities)	articles/ chemical products
361	alpha-Chlordane	5103-71-9	Contains (regardless of intentional or impurities)	articles/ chemical products
362	trans-Chlordane	5103-74-2	Contains (regardless of intentional or impurities)	articles/ chemical products
363	Butylmercury acetate	5131-56-6	Contains (regardless of intentional or impurities)	articles/ chemical products
364	Mercury, chloro(trans-2-methoxycyclooctyl)-	5185-84-2	Contains (regardless of intentional or impurities)	articles/ chemical products
365	Triethyllead	5224-23-7	Contains (regardless of intentional or impurities)	articles/ chemical products
366	Mercury, bromo[1-(methoxyphenylmethyl)-2-oxo-2-(1,1,7-trimethylbicyclo[2.2.1]hept-2-yl)oxy]ethyl-	5240-00-1	Contains (regardless of intentional or impurities)	articles/ chemical products
367	Mercury, (dodecylthio)phenyl-	5416-74-0	Contains (regardless of intentional or impurities)	articles/ chemical products
368	Mercury, (acetato-O)(diethyl phosphite-P)-	5421-48-7	Contains (regardless of intentional or impurities)	articles/ chemical products
369	Mercury, chloro-3-pyridyl-	5429-90-0	Contains (regardless of intentional or impurities)	articles/ chemical products
370	2,2',4,4'-Tetrabromodiphenyl ether	5436-43-1	Contains (regardless of intentional or impurities)	articles/ chemical products
371	gamma-Chlordane	5568-34-7	Contains (regardless of intentional or impurities)	articles/ chemical products
372	[benzoato(2-)-O2O]mercury	5722-59-8	Contains (regardless of intentional or impurities)	articles/ chemical products
373	1,4,5,6,7,7-Hexachloro-N-(phenylmercury)bicyclo(2,1)hept-5-ene-2,3-dicarboximide	5834-81-1	Contains (regardless of intentional or impurities)	articles/ chemical products
374	2-(Chloromercury)furan	5857-37-4	Contains (regardless of intentional or impurities)	articles/ chemical products
375	3-(Chloromercury)furan	5857-38-5	Contains (regardless of intentional or impurities)	articles/ chemical products
376	Chloro-2-thienylmercury	5857-39-6	Contains (regardless of intentional or impurities)	articles/ chemical products
377	Methyl(pentachlorophenolato)mercury	5902-76-1	Contains (regardless of intentional or impurities)	articles/ chemical products
378	Mercury, (1,4,5,6,7,7-hexachloro-5-norbornene-2,3-dicarboximidato)methyl-	5902-79-4	Contains (regardless of intentional or impurities)	articles/ chemical products
379	Methylmercury propionate	5903-10-6	Contains (regardless of intentional or impurities)	articles/ chemical products
380	Mercury, (acetato-O)[3-(chloromethoxy)propyl-C,O]-	5954-14-3	Contains (regardless of intentional or impurities)	articles/ chemical products
381	Chloro-m-tolylmercury	5955-19-1	Contains (regardless of intentional or impurities)	articles/ chemical products
382	Sodium timerfonate	5964-24-9	Contains (regardless of intentional or impurities)	articles/ chemical products
383	Mercury salicylate	5970-32-1	Contains (regardless of intentional or impurities)	articles/ chemical products
384	Mercury, chloro(2-chloroethyl)-	5980-86-9	Contains (regardless of intentional or impurities)	articles/ chemical products
385	(3-Ethoxypropyl)mercury bromide	6012-84-6	Contains (regardless of intentional or impurities)	articles/ chemical products
386	2,5-Methano-2H-indeno[1,2-b]oxirene, 2,3,4,5,7,7-hexachloro-1a,1b,5,5a,6,6a-hexahydro-	6058-23-7	Contains (regardless of intentional or impurities)	articles/ chemical products
387	Acetic acid, lead(2+) salt, trihydrate	6080-56-4	Contains (regardless of intentional or impurities)	articles/ chemical products
388	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, lead(2+) salt (2:3), trihydrate	6107-83-1	Contains (regardless of intentional or impurities)	articles/ chemical products
389	Salicylic acid, lead(2+) salt (2:1), monohydrate	6107-93-3	Contains (regardless of intentional or impurities)	articles/ chemical products
390	Bromotrimethyllead	6148-48-7	Contains (regardless of intentional or impurities)	articles/ chemical products
391	2,5-Bis(chloromercury)furan	6270-99-1	Contains (regardless of intentional or impurities)	articles/ chemical products
392	[mu-(Orthorobato(2-)-O,O')]diphenylmercury	6273-99-0	Contains (regardless of intentional or impurities)	articles/ chemical products
393	Mercury, (acetato-O)(4-aminophenyl)-	6283-24-5	Contains (regardless of intentional or impurities)	articles/ chemical products
394	Mercury, (acetato)1,2,3,6-tetrahydro-1,3-dimethyl-2,6-dioxapurin-8-yl)-	6336-12-5	Contains (regardless of intentional or impurities)	articles/ chemical products
395	(E)-5,5,12,12-Tetrabutyl-7,10-dioxo-6,11-dioxo-5,12-distannahexadec-8-ene	6454-35-9	Contains (regardless of intentional or impurities)	articles/ chemical products
396	Phenol, 4-(1-propylbutyl)-	6465-71-0	Intentional addition / 1,000ppm	articles/ chemical products
397	Phenol, 4-(1-ethylpentyl)-	6465-74-3	Intentional addition / 1,000ppm	articles/ chemical products
398	Lead dipicrate	6477-64-1	Contains (regardless of intentional or impurities)	articles/ chemical products
399	Tributyltin sulfamate	6517-25-5	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
400	1,2,4,8-Tetrachloronaphthalene	6529-87-9	Contains (regardless of intentional or impurities)	articles/ chemical products
401	1,2,4,5-Tetrachloronaphthalene	6733-54-6	Contains (regardless of intentional or impurities)	articles/ chemical products
402	1-Naphthalenemethanol, .alpha..alpha.-bis[4-(dimethylamino)phenyl]-4-(phenylamino)-	6786-83-0	Intentional addition / 1,000ppm	articles/ chemical products
403	Bis(trichloromethyl)mercury	6795-81-9	Contains (regardless of intentional or impurities)	articles/ chemical products
404	Phenol, 4,4'-(1,3-dimethylbutylidene)bis-	6807-17-6	Contains (regardless of intentional or impurities)	articles/ chemical products
405	1,2-Benzenedicarboxylic acid, lead(2+) salt (1:1)	6838-85-3	Contains (regardless of intentional or impurities)	articles/ chemical products
406	Phenol, 4-(1-methylhexyl)-	6863-24-7	Intentional addition / 1,000ppm	articles/ chemical products
407	Lead(2+) bis(diethylcarbamodithioate)	6901-79-7	Contains (regardless of intentional or impurities)	articles/ chemical products
408	Mercury, bis(1,2,3,6-tetrahydro-1,3,7-trimethyl-2,6-dioxapurin-8-yl)-	6937-66-2	Contains (regardless of intentional or impurities)	articles/ chemical products
409	2,4,4'-trichlorobiphenyl	7012-37-5	Contains (regardless of intentional or impurities)	articles/ chemical products
410	Formic acid, lead salt	7056-83-9	Contains (regardless of intentional or impurities)	articles/ chemical products
411	(Chloroacetoxy)triphenylstannane	7094-84-2	Contains (regardless of intentional or impurities)	articles/ chemical products
412	Ethanol, 2-[2-[2-(4-monylphenoxy)ethoxy]ethoxy]ethoxy]-	7311-27-5	Intentional addition / 1,000ppm	articles/ chemical products
413	Lead(2+) octanoate	7319-86-0	Contains (regardless of intentional or impurities)	articles/ chemical products
414	Lead stearate	7428-48-0	Contains (regardless of intentional or impurities)	articles/ chemical products
415	Lead	7439-92-1	Contains (regardless of intentional or impurities)	articles/ chemical products
416	Mercury	7439-97-6	Contains (regardless of intentional or impurities)	articles/ chemical products
417	Cadmium	7440-43-9	Contains (regardless of intentional or impurities)	articles/ chemical products
418	Sulfurous acid, lead(2+) salt (1:1)	7446-10-8	Contains (regardless of intentional or impurities)	articles/ chemical products
419	Sulfuric acid, lead(2+) salt (1:1)	7446-14-2	Contains (regardless of intentional or impurities)	articles/ chemical products
420	Lead selenate	7446-15-3	Contains (regardless of intentional or impurities)	articles/ chemical products
421	Phosphoric acid, lead(2+) salt (2:3)	7446-27-7	Contains (regardless of intentional or impurities)	articles/ chemical products
422	Mercury chloride (HgCl2)	7487-94-7	Contains (regardless of intentional or impurities)	articles/ chemical products
423	Lead selenite	7488-51-9	Contains (regardless of intentional or impurities)	articles/ chemical products
424	Phenol, pentachloro-, carbonate (2:1)	7497-08-7	Contains (regardless of intentional or impurities)	articles/ chemical products
425	Mercury chloride (HgCl)	7546-30-7	Contains (regardless of intentional or impurities)	articles/ chemical products
426	Mercury, (2-mercaptoacetamidato-O,S)methyl	7548-26-7	Contains (regardless of intentional or impurities)	articles/ chemical products
427	Perchloric acid, mercury(2+) salt	7616-83-3	Contains (regardless of intentional or impurities)	articles/ chemical products
428	Perboric acid (HBO(O)2), sodium salt	7632-04-4	Contains (regardless of intentional or impurities)	articles/ chemical products
429	Lead arsenate, unspecified	7645-25-2	Contains (regardless of intentional or impurities)	articles/ chemical products
430	Cobalt chloride (CoCl2)	7646-79-9	Contains (regardless of intentional or impurities)	articles/ chemical products
431	Mercury, (3-(3-(carboxymethoxy)benzamido)-2-methoxypropyl)hydroxy-, monosodium salt, compound with theophylline	7681-34-7	Contains (regardless of intentional or impurities)	articles/ chemical products
432	Lead(4+) stearate	7717-46-6	Contains (regardless of intentional or impurities)	articles/ chemical products
433	Chromic acid (H2CrO4)	7738-94-5	Contains (regardless of intentional or impurities)	articles/ chemical products
434	Mercury(2+) (9Z,12Z)-octadeca-9,12-dienoate	7756-49-2	Contains (regardless of intentional or impurities)	articles/ chemical products
435	Lead chloride (PbCl2)	7758-95-4	Contains (regardless of intentional or impurities)	articles/ chemical products
436	Chromic acid (H2CrO4), lead(2+) salt (1:1)	7758-97-6	Contains (regardless of intentional or impurities)	articles/ chemical products
437	Lead tungsten oxide	7759-01-5	Contains (regardless of intentional or impurities)	articles/ chemical products
438	Mercuric iodide	7774-29-0	Contains (regardless of intentional or impurities)	articles/ chemical products
439	Arsenic acid (H3AsO4), hemihydrate	7774-41-6	Contains (regardless of intentional or impurities)	articles/ chemical products
440	Sodium chromate	7775-11-3	Contains (regardless of intentional or impurities)	articles/ chemical products
441	Arsenic acid	7778-39-4	Contains (regardless of intentional or impurities)	articles/ chemical products
442	Arsenic acid (H3AsO4), calcium salt (2:3)	7778-44-1	Contains (regardless of intentional or impurities)	articles/ chemical products
443	Potassium dichromate	7778-50-9	Contains (regardless of intentional or impurities)	articles/ chemical products
444	Potassium pentachlorophenate	7778-73-6	Contains (regardless of intentional or impurities)	articles/ chemical products
445	Trimercury(2+) diphosphate	7782-66-3	Contains (regardless of intentional or impurities)	articles/ chemical products
446	Nitric acid, mercury(1+) salt, monohydrate	7782-86-7	Contains (regardless of intentional or impurities)	articles/ chemical products
447	Mercury(I) iodide	7783-30-4	Contains (regardless of intentional or impurities)	articles/ chemical products
448	Mercury diiodate	7783-32-6	Contains (regardless of intentional or impurities)	articles/ chemical products
449	Mercury(II) nitrate monohydrate	7783-34-8	Contains (regardless of intentional or impurities)	articles/ chemical products
450	Sulfuric acid, mercury(2+) salt (1:1)	7783-35-9	Contains (regardless of intentional or impurities)	articles/ chemical products
451	Sulfuric acid, dimercury(1+) salt	7783-36-0	Contains (regardless of intentional or impurities)	articles/ chemical products
452	Mercury fluoride (HgF2)	7783-39-3	Contains (regardless of intentional or impurities)	articles/ chemical products
453	Lead fluoride (PbF2)	7783-46-2	Contains (regardless of intentional or impurities)	articles/ chemical products
454	Lead(IV) fluoride	7783-59-7	Contains (regardless of intentional or impurities)	articles/ chemical products
455	Mercury dichlor tetraiodide	7784-03-4	Contains (regardless of intentional or impurities)	articles/ chemical products
456	Mercuric arsenate	7784-37-4	Contains (regardless of intentional or impurities)	articles/ chemical products
457	Arsenic acid (H3AsO4), lead(4+) salt (3:2)	7784-40-9	Contains (regardless of intentional or impurities)	articles/ chemical products
458	Chromic acid (H2CrO4), dipotassium salt	7789-00-6	Contains (regardless of intentional or impurities)	articles/ chemical products
459	Strontium chromate	7789-06-2	Contains (regardless of intentional or impurities)	articles/ chemical products
460	Ammonium dichromate	7789-09-5	Contains (regardless of intentional or impurities)	articles/ chemical products
461	Mercury dichromate	7789-10-8	Contains (regardless of intentional or impurities)	articles/ chemical products
462	Sodium dichromate, dihydrate	7789-12-0	Contains (regardless of intentional or impurities)	articles/ chemical products
463	Mercury bromide (HgBr2)	7789-47-1	Contains (regardless of intentional or impurities)	articles/ chemical products
464	Cadmium chloride (CdCl2), hydrate (2:5)	7790-78-5	Contains (regardless of intentional or impurities)	articles/ chemical products
465	Cadmium fluoride (CdF2)	7790-79-6	Contains (regardless of intentional or impurities)	articles/ chemical products
466	Sulfuric acid, cadmium salt (1:1), hydrate (3:8)	7790-84-3	Contains (regardless of intentional or impurities)	articles/ chemical products
467	Hydrazine monohydrate	7803-57-8	Intentional addition / 1,000ppm	articles/ chemical products
468	Toxaphene	8001-35-2	Contains (regardless of intentional or impurities)	articles/ chemical products
469	Mercury, hydroxyphenyl-, mixture with (nitro-O)phenylmercury	8003-05-2	Contains (regardless of intentional or impurities)	articles/ chemical products
470	C.I. Pigment Yellow 41	8012-00-8	Contains (regardless of intentional or impurities)	articles/ chemical products
471	Mercury, (3-(3-(carboxy-2,2,3-trimethylcyclopentane-carboxamido)-2-methoxypropyl)hydroxy-, mixture with theophylline	8012-34-8	Contains (regardless of intentional or impurities)	articles/ chemical products
472	Poly(oxy-1,2-ethanediyl), .alpha.-[4-(1,1,3,3-tetramethylbutyl)phenyl]-.omega.-hydroxy-	9002-93-1	Intentional addition / 1,000ppm	articles/ chemical products
473	Resin acids and Rosin acids, lead salts	9008-26-8	Contains (regardless of intentional or impurities)	articles/ chemical products
474	Poly(oxy-1,2-ethanediyl), .alpha.-[nonylphenyl]-.omega.-hydroxy-	9016-45-9	Contains (regardless of intentional or impurities)	articles/ chemical products
475	Poly(oxy-1,2-ethanediyl), .alpha.-[[1,1,3,3-tetramethylbutyl)phenyl]-.omega.-hydroxy-	9036-19-5	1,000ppm	articles/ chemical products
476	Cadmium(II) nitrate, tetrahydrate (1:2:4)	10022-68-1	Contains (regardless of intentional or impurities)	articles/ chemical products
477	Cobalt(II) nitrate, hexahydrate	10026-22-9	Intentional addition / 1,000ppm	articles/ chemical products
478	Lead arsenite	10031-13-7	Contains (regardless of intentional or impurities)	articles/ chemical products
479	Mercury bromide (HgBr)	10031-18-2	Contains (regardless of intentional or impurities)	articles/ chemical products
480	Lead bromide (PbBr2)	10031-22-8	Contains (regardless of intentional or impurities)	articles/ chemical products
481	Boric acid (H3BO3)	10043-35-3	Contains (regardless of intentional or impurities)	articles/ chemical products
482	Mercury(II) nitrate	10045-94-0	Contains (regardless of intentional or impurities)	articles/ chemical products
483	Barium tetraiodomercurate	10048-99-4	Contains (regardless of intentional or impurities)	articles/ chemical products
484	Lead nitrate	10099-74-8	Contains (regardless of intentional or impurities)	articles/ chemical products
485	Silicic acid (H2SiO3), lead(2+) salt (1:1)	10099-76-0	Contains (regardless of intentional or impurities)	articles/ chemical products
486	Lead vanadate	10099-79-3	Contains (regardless of intentional or impurities)	articles/ chemical products
487	Lead iodide	10101-63-0	Contains (regardless of intentional or impurities)	articles/ chemical products
488	Arsenic acid (H3AsO4), lead(4+) salt (3:2)	10102-48-4	Contains (regardless of intentional or impurities)	articles/ chemical products
489	Cadmium chloride	10108-64-2	Contains (regardless of intentional or impurities)	articles/ chemical products
490	Mercury chloride (Hg2O2)	10112-91-1	Contains (regardless of intentional or impurities)	articles/ chemical products
491	Sulfuric acid, cadmium salt (1:1)	10124-36-4	Contains (regardless of intentional or impurities)	articles/ chemical products
492	Cobalt sulfate	10124-43-3	Contains (regardless of intentional or impurities)	articles/ chemical products
493	Mercury amide chloride (Hg(NH2)Cl)	10124-48-8	Contains (regardless of intentional or impurities)	articles/ chemical products
494	Nitric acid, cobalt(2+) salt	10141-05-6	Contains (regardless of intentional or impurities)	articles/ chemical products
495	Lead molybdate	10190-55-3	Contains (regardless of intentional or impurities)	articles/ chemical products
496	Boric acid (HBO2), lead(2+) salt, monohydrate	10214-39-8	Contains (regardless of intentional or impurities)	articles/ chemical products
497	Dihexylmercury	10217-65-9	Contains (regardless of intentional or impurities)	articles/ chemical products
498	Dipentylmercury	10217-67-1	Contains (regardless of intentional or impurities)	articles/ chemical products
499	Didodecylmercury	10217-88-2	Contains (regardless of intentional or impurities)	articles/ chemical products
500	Lead dichlorate	10294-47-0	Intentional addition / 1,000ppm	articles/ chemical products
501	Lead diphosphinate	10294-58-3	Contains (regardless of intentional or impurities)	articles/ chemical products
502	Cadmium nitrate	10325-94-7	Contains (regardless of intentional or impurities)	articles/ chemical products
503	Perboric acid (HBO(O)2), sodium salt, monohydrate	10332-33-9	Contains (regardless of intentional or impurities)	articles/ chemical products
504	Benzylmercury acetate	10341-89-6	Contains (regardless of intentional or impurities)	articles/ chemical products
505	Pentachlorophenyl oleate	10443-46-6	Contains (regardless of intentional or impurities)	articles/ chemical products
506	Phosphoric acid, mercury salts	10451-12-4	Contains (regardless of intentional or impurities)	articles/ chemical products
507	Sodium perborate tetrahydrate	10486-00-7	Contains (regardless of intentional or impurities)	articles/ chemical products
508	Chromic acid (H2Cr2O7), disodium salt	10588-01-9	Contains (regardless of intentional or impurities)	articles/ chemical products
509	Mercury, compound with titanium (1:3)	11083-41-3	Contains (regardless of intentional or impurities)	articles/ chemical products
510	Chlorodiphenyl (54% chlorine)	11097-69-1	Contains (regardless of intentional or impurities)	articles/ chemical products
511	Potassium zinc chromate hydroxide (KZn2(CrO4)2(OH))	11103-86-9	Contains (regardless of intentional or impurities)	articles/ chemical products
512	Aroclor 1221	11104-28-2	Intentional addition / 1,000ppm	articles/ chemical products
513	Boric acid	11113-50-1	Contains (regardless of intentional or impurities)	articles/ chemical products
514	Dimethyl dilaed tetraurthenium tridecaoxide	11116-83-9	Contains (regardless of intentional or impurities)	articles/ chemical products
515	Chromium lead oxide	11119-70-3	Contains (regardless of intentional or impurities)	articles/ chemical products
516	Silicic acid, lead salt	11120-22-2	Contains (regardless of intentional or impurities)	articles/ chemical products
517	Perboric acid, sodium salt	11138-47-9	Contains (regardless of intentional or impurities)	articles/ chemical products
518	Aroclor 1232	11141-16-5	Intentional addition / 1,000ppm	articles/ chemical products
519	Mercuriol	12002-19-6	Contains (regardless of intentional or impurities)	articles/ chemical products
520	Boron sodium oxide (B2Na2O13)	12008-41-2	Contains (regardless of intentional or impurities)	articles/ chemical products
521	Plumbate (PbO4--), calcium (1:2), (T-4)-	12013-69-3	Contains (regardless of intentional or impurities)	articles/ chemical products
522	Dilaed chromate dihydroxide	12017-86-6	Contains (regardless of intentional or impurities)	articles/ chemical products
523	Iron lead oxide (Fe12PbO19)	12023-90-4	Contains (regardless of intentional or impurities)	articles/ chemical products
524	Hafnium lead trioxide	12029-23-1	Contains (regardless of intentional or impurities)	articles/ chemical products
525	Plumbate (PbO2--), disodium	12034-30-9	Contains (regardless of intentional or impurities)	articles/ chemical products
526	Lead neobate	12034-88-7	Contains (regardless of intentional or impurities)	articles/ chemical products
527	Lead tin oxide (PbSnO3)	12036-31-6	Contains (regardless of intentional or impurities)	articles/ chemical products
528	Lead oxide sulfate (Pb2O(SO4))	12036-76-9	Contains (regardless of intentional or impurities)	articles/ chemical products
529	Lead oxide sulfate (PB3O2(SO4))	12036-93-0	Contains (regardless of intentional or impurities)	articles/ chemical products
530	Perboric acid, sodium salt, monohydrate	12040-72-1	Contains (regardless of intentional or impurities)	articles/ chemical products
531	Bismuth, compound with lead (1:1)	12048-28-1	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
532	Mercury, compound with sodium (2:1)	12055-37-7	Contains (regardless of intentional or impurities)	articles/ chemical products
533	Lead oxide (Pb2O)	12059-89-1	Contains (regardless of intentional or impurities)	articles/ chemical products
534	Lead titanium oxide (PbTiO3)	12060-00-3	Contains (regardless of intentional or impurities)	articles/ chemical products
535	Lead zirconate	12060-01-4	Contains (regardless of intentional or impurities)	articles/ chemical products
536	Lead tantalate	12065-68-8	Contains (regardless of intentional or impurities)	articles/ chemical products
537	Lead oxide sulfate (Pb5O4(SO4))	12065-90-6	Contains (regardless of intentional or impurities)	articles/ chemical products
538	Mercury telluride (HgTe)	12068-90-5	Contains (regardless of intentional or impurities)	articles/ chemical products
539	Lead sulfide (Pb(SH)2)	12135-36-3	Contains (regardless of intentional or impurities)	articles/ chemical products
540	Mercury nitride	12136-15-1	Contains (regardless of intentional or impurities)	articles/ chemical products
541	Lead disulfide	12137-74-5	Contains (regardless of intentional or impurities)	articles/ chemical products
542	Lead oxide phosphonate (Pb3O2(HPO3))	12141-20-7	Contains (regardless of intentional or impurities)	articles/ chemical products
543	Lead tin oxide (Pb2SnO4)	12143-43-0	Contains (regardless of intentional or impurities)	articles/ chemical products
544	Lead vanadium chloride oxide	12157-94-7	Contains (regardless of intentional or impurities)	articles/ chemical products
545	Dicadium tetraborate pentahydrate	12179-04-3	Contains (regardless of intentional or impurities)	articles/ chemical products
546	Lead oxide sulfate (Pb4O3(SO4))	12202-17-4	Contains (regardless of intentional or impurities)	articles/ chemical products
547	Lead chloride oxide	12205-72-0	Contains (regardless of intentional or impurities)	articles/ chemical products
548	Lead oxide (PbO3)	12214-45-8	Contains (regardless of intentional or impurities)	articles/ chemical products
549	Antimony, compound with lead (1:1)	12266-38-5	Contains (regardless of intentional or impurities)	articles/ chemical products
550	Tetaboron disodium heptaoxide, hydrate	12267-73-1	Contains (regardless of intentional or impurities)	articles/ chemical products
551	Lead hydroxide nitrate	12268-84-7	Contains (regardless of intentional or impurities)	articles/ chemical products
552	1,3,5,7,9-Pentaoxa-2,4,6,8,10,12,14,16,18,20,22,24,26,28,30,32,34,36,38,40,42,44,46,48,50,52,54,56,58,60,62,64,66,68,70,72,74,76,78,80,82,84,86,88,90,92,94,96,98,100,102,104,106,108,110,112,114,116,118,120,122,124,126,128,130,132,134,136,138,140,142,144,146,148,150,152,154,156,158,160,162,164,166,168,170,172,174,176,178,180,182,184,186,188,190,192,194,196,198,200,202,204,206,208,210,212,214,216,218,220,222,224,226,228,230,232,234,236,238,240,242,244,246,248,250,252,254,256,258,260,262,264,266,268,270,272,274,276,278,280,282,284,286,288,290,292,294,296,298,300,302,304,306,308,310,312,314,316,318,320,322,324,326,328,330,332,334,336,338,340,342,344,346,348,350,352,354,356,358,360,362,364,366,368,370,372,374,376,378,380,382,384,386,388,390,392,394,396,398,400,402,404,406,408,410,412,414,416,418,420,422,424,426,428,430,432,434,436,438,440,442,444,446,448,450,452,454,456,458,460,462,464,466,468,470,472,474,476,478,480,482,484,486,488,490,492,494,496,498,500,502,504,506,508,510,512,514,516,518,520,522,524,526,528,530,532,534,536,538,540,542,544,546,548,550,552,554,556,558,560,562,564,566,568,570,572,574,576,578,580,582,584,586,588,590,592,594,596,598,600,602,604,606,608,610,612,614,616,618,620,622,624,626,628,630,632,634,636,638,640,642,644,646,648,650,652,654,656,658,660,662,664,666,668,670,672,674,676,678,680,682,684,686,688,690,692,694,696,698,700,702,704,706,708,710,712,714,716,718,720,722,724,726,728,730,732,734,736,738,740,742,744,746,748,750,752,754,756,758,760,762,764,766,768,770,772,774,776,778,780,782,784,786,788,790,792,794,796,798,800,802,804,806,808,810,812,814,816,818,820,822,824,826,828,830,832,834,836,838,840,842,844,846,848,850,852,854,856,858,860,862,864,866,868,870,872,874,876,878,880,882,884,886,888,890,892,894,896,898,900,902,904,906,908,910,912,914,916,918,920,922,924,926,928,930,932,934,936,938,940,942,944,946,948,950,952,954,956,958,960,962,964,966,968,970,972,974,976,978,980,982,984,986,988,990,992,994,996,998,1000	12275-07-9	Contains (regardless of intentional or impurities)	articles/ chemical products
553	Mercury silver iodide	12344-40-0	Contains (regardless of intentional or impurities)	articles/ chemical products
554	Bismuth lead oxide	12356-42-2	Contains (regardless of intentional or impurities)	articles/ chemical products
555	Lead bismuth sulfide	12377-89-4	Contains (regardless of intentional or impurities)	articles/ chemical products
556	Lead oxide sulfate (Pb4O3(SO4)), monohydrate	12397-06-7	Contains (regardless of intentional or impurities)	articles/ chemical products
557	Lead, dihydroxy[2,4,6-trinitro-1,3-benzenediolato(2-)]di-	12403-82-6	Contains (regardless of intentional or impurities)	articles/ chemical products
558	Lead tin telluride (PbSnTe2)	12412-92-9	Contains (regardless of intentional or impurities)	articles/ chemical products
559	Lead germanate	12435-47-1	Contains (regardless of intentional or impurities)	articles/ chemical products
560	Lead, bis(octadecanoato)dioxotri-	12578-12-0	Contains (regardless of intentional or impurities)	articles/ chemical products
561	Basic lead sulfite	12608-25-2	Contains (regardless of intentional or impurities)	articles/ chemical products
562	Lead chloride (VAN.)	12612-47-4	Contains (regardless of intentional or impurities)	articles/ chemical products
563	Lead titanium zirconium oxide (Pb(Ti,Zr)O3)	12626-81-2	Contains (regardless of intentional or impurities)	articles/ chemical products
564	Mercury oxides	12653-71-3	Contains (regardless of intentional or impurities)	articles/ chemical products
565	C.I. Pigment Red 104	12656-85-8	Contains (regardless of intentional or impurities)	articles/ chemical products
566	Aroclor 1248	12672-29-6	Intentional addition / 1,000ppm	articles/ chemical products
567	Aroclor 1016	12674-11-2	Intentional addition / 1,000ppm	articles/ chemical products
568	Lead borate	12676-62-9	Contains (regardless of intentional or impurities)	articles/ chemical products
569	Lead iodide	12684-19-4	Contains (regardless of intentional or impurities)	articles/ chemical products
570	Lead silicate sulfate	12687-78-4	Contains (regardless of intentional or impurities)	articles/ chemical products
571	Chromium lead molybdenum oxide	12709-98-7	Contains (regardless of intentional or impurities)	articles/ chemical products
572	Lead tungsten oxide	12737-98-3	Contains (regardless of intentional or impurities)	articles/ chemical products
573	Lead-sodium alloy	12740-44-2	Contains (regardless of intentional or impurities)	articles/ chemical products
574	Lead oxide sulfate	12765-51-4	Contains (regardless of intentional or impurities)	articles/ chemical products
575	Calcium plumbate	12774-29-7	Contains (regardless of intentional or impurities)	articles/ chemical products
576	Chlordane	12789-03-6	Contains (regardless of intentional or impurities)	articles/ chemical products
577	Carbonic acid, mercury(2+) salt (1:1)	13004-83-6	Intentional addition / 1%	articles/ chemical products
578	PCB 4	13029-08-8	Contains (regardless of intentional or impurities)	articles/ chemical products
579	1,1'-Biphenyl, 2,2'-dibromo-	13029-09-9	Contains (regardless of intentional or impurities)	articles/ chemical products
580	Lead(2+) (R)-12-hydroxylolate	13094-04-7	Contains (regardless of intentional or impurities)	articles/ chemical products
581	cis-cyclohexane-1,2-dicarboxylic anhydride	13149-00-3	Contains (regardless of intentional or impurities)	articles/ chemical products
582	Hexanoic acid, 2-ethyl-, mercury(2+) salt	13170-76-8	Contains (regardless of intentional or impurities)	articles/ chemical products
583	Acetophenone, hydrate, compound with mercury chloride (HgCl2) (1:1)	13222-52-1	Contains (regardless of intentional or impurities)	articles/ chemical products
584	2,3,3,3-Tetrafluoro-2-(heptafluoropropoxy)propionic acid	13252-13-6	1,000ppm	articles/ chemical products
585	Mercury bis(trifluoroacetate)	13257-51-7	Contains (regardless of intentional or impurities)	articles/ chemical products
586	Bis(tributylmercury) sulfide	13278-80-3	Contains (regardless of intentional or impurities)	articles/ chemical products
587	Bis(trimethylsilylmethyl)mercury	13284-23-0	Contains (regardless of intentional or impurities)	articles/ chemical products
588	Mercury (2-ethylhexanoato-O)phenyl-	13302-00-6	Contains (regardless of intentional or impurities)	articles/ chemical products
589	Lead(2+) 2,4-dinitroresorcinolate	13406-89-8	Contains (regardless of intentional or impurities)	articles/ chemical products
590	Lead azide	13424-46-9	Contains (regardless of intentional or impurities)	articles/ chemical products
591	Carbonic acid, lead salt	13427-42-4	Contains (regardless of intentional or impurities)	articles/ chemical products
592	Mercury(II) chromate	13444-75-2	Contains (regardless of intentional or impurities)	articles/ chemical products
593	Lead dichlorite	13453-57-1	Intentional addition / 1,000ppm	articles/ chemical products
594	Lead(II) perchlorate trihydrate	13453-62-8	Contains (regardless of intentional or impurities)	articles/ chemical products
595	Phosphonic acid, lead(2+) salt (1:1)	13453-65-1	Contains (regardless of intentional or impurities)	articles/ chemical products
596	Lead pyrophosphate	13453-66-2	Contains (regardless of intentional or impurities)	articles/ chemical products
597	Mercury(II) phosphate	13464-28-3	Contains (regardless of intentional or impurities)	articles/ chemical products
598	Lead metaarsenate	13464-43-2	Contains (regardless of intentional or impurities)	articles/ chemical products
599	Nitric acid, mercury(2+) salt, hemihydrate	13465-31-1	Contains (regardless of intentional or impurities)	articles/ chemical products
600	Mercury(1+) bromate	13465-33-3	Contains (regardless of intentional or impurities)	articles/ chemical products
601	Mercury(I) chromate	13465-34-4	Contains (regardless of intentional or impurities)	articles/ chemical products
602	Mercury thiocyanate	13465-37-7	Intentional addition / 1%	articles/ chemical products
603	Lead thiosulfate	13478-50-7	Contains (regardless of intentional or impurities)	articles/ chemical products
604	Antimony lead oxide (Sb2Pb3O8)	13510-89-9	Contains (regardless of intentional or impurities)	articles/ chemical products
605	Lead hydrogenarsenate	13510-91-3	Contains (regardless of intentional or impurities)	articles/ chemical products
606	Lead pyroarsenate	13510-94-6	Contains (regardless of intentional or impurities)	articles/ chemical products
607	Lead dichlorate monohydrate	13510-96-8	Intentional addition / 1,000ppm	articles/ chemical products
608	Perboric acid (H3BO2(O2)), monosodium salt, trihydrate	13517-20-9	Contains (regardless of intentional or impurities)	articles/ chemical products
609	Chromic acid (H2Cr2O7)	13530-68-2	Contains (regardless of intentional or impurities)	articles/ chemical products
610	1,4,7,10-Dimethanodibenzo[a,e]cyclooctene, 1,2,3,4,7,8,9,10,13,13,14,14-dodecachloro-1,4,4a,5,6,6a,7,10,10a,11,12,12a-dodecahydro-	13560-89-9	Intentional addition / 100ppm	articles/ chemical products
611	Lead silicate	13566-17-1	Contains (regardless of intentional or impurities)	articles/ chemical products
612	Lead perchlorate	13637-76-8	Contains (regardless of intentional or impurities)	articles/ chemical products
613	Decabromobiphenyl	13654-09-6	Contains (regardless of intentional or impurities)	articles/ chemical products
614	N2-Benzyl pentachlorophenyl N2-carboxy-L-(2-aminoglutaramate)	13673-51-3	Contains (regardless of intentional or impurities)	articles/ chemical products
615	Perchlorophenyl N-(benzyloxycarbonyl)-L-isoleucinate	13673-53-5	Contains (regardless of intentional or impurities)	articles/ chemical products
616	Perchlorophenyl S-benzyl-N-(benzyloxycarbonyl)-L-cysteinate	13673-54-6	Contains (regardless of intentional or impurities)	articles/ chemical products
617	2-Butenedioic acid (E)-, lead salt	13698-55-0	Contains (regardless of intentional or impurities)	articles/ chemical products
618	Tetrabromolead	13701-91-2	Intentional addition / 1,000ppm	articles/ chemical products
619	Diboric acid, lead(2+) salt (1:2)	13703-85-0	Contains (regardless of intentional or impurities)	articles/ chemical products
620	Cyanotriethyllead	13732-17-7	Contains (regardless of intentional or impurities)	articles/ chemical products
621	Sulfurous acid, mercury salt	13766-41-1	Contains (regardless of intentional or impurities)	articles/ chemical products
622	Mercury sulfates	13766-44-4	Contains (regardless of intentional or impurities)	articles/ chemical products
623	Lead disulphidate	13767-78-7	Contains (regardless of intentional or impurities)	articles/ chemical products
624	Lead iodide (PbI)	13779-93-6	Contains (regardless of intentional or impurities)	articles/ chemical products
625	Lead iodide	13779-98-1	Contains (regardless of intentional or impurities)	articles/ chemical products
626	Borate(1-), tetrafluoro-, lead(2+) (2:1)	13814-96-5	Contains (regardless of intentional or impurities)	articles/ chemical products
627	Nitrous acid, lead(2+) salt	13826-85-8	Contains (regardless of intentional or impurities)	articles/ chemical products
628	Boric acid (H3BO3), sodium salt	13840-56-7	Contains (regardless of intentional or impurities)	articles/ chemical products
629	Lead tellurite	13845-35-7	Contains (regardless of intentional or impurities)	articles/ chemical products
630	Phenylmercuric octanoate	13864-38-5	Contains (regardless of intentional or impurities)	articles/ chemical products
631	Mercurate(2-), tetraiodo-, dicopper(1+), (T-4)-	13876-85-2	Contains (regardless of intentional or impurities)	articles/ chemical products
632	Lead chloride (PbCl)	13931-84-5	Contains (regardless of intentional or impurities)	articles/ chemical products
633	Perchloric acid, mercury(1+) salt	13932-02-0	Contains (regardless of intentional or impurities)	articles/ chemical products
634	Dimercury difluoride	13967-25-4	Contains (regardless of intentional or impurities)	articles/ chemical products
635	Mercury 197	13981-51-6	Contains (regardless of intentional or impurities)	articles/ chemical products
636	Mercury 203	13982-78-0	Contains (regardless of intentional or impurities)	articles/ chemical products
637	Mercury pentanedione	14024-55-6	Contains (regardless of intentional or impurities)	articles/ chemical products
638	Nicotine, compound with mercury chloride	14032-92-9	Contains (regardless of intentional or impurities)	articles/ chemical products
639	(2-carboxyphenyl)hydroxymercury	14066-61-6	Contains (regardless of intentional or impurities)	articles/ chemical products
640	Mercury dipotassium tetrathiocyanate	14099-12-8	Contains (regardless of intentional or impurities)	articles/ chemical products
641	Lead 205	14119-28-9	Contains (regardless of intentional or impurities)	articles/ chemical products
642	Lead 209	14119-30-3	Contains (regardless of intentional or impurities)	articles/ chemical products
643	trans-cyclohexane-1,2-dicarboxylic anhydride	14166-21-3	Contains (regardless of intentional or impurities)	articles/ chemical products
644	Mercury diazide	14215-33-9	Intentional addition / 1%	articles/ chemical products
645	Lead 210	14255-04-0	Contains (regardless of intentional or impurities)	articles/ chemical products
646	Bis(tributyltin) maleate	14275-57-1	Contains (regardless of intentional or impurities)	articles/ chemical products
647	Lead(2+)	14280-50-3	Contains (regardless of intentional or impurities)	articles/ chemical products
648	Trisodium orthoborate	14312-40-4	Intentional addition / 1%	articles/ chemical products
649	Phenyl(quinolin-8-olato-N1,O8)mercury	14354-56-4	Contains (regardless of intentional or impurities)	articles/ chemical products
650	Mercury, diamminedichloro-, (T-4)-	14376-09-1	Contains (regardless of intentional or impurities)	articles/ chemical products
651	Ferrate(4-), hexakis(cyano-kappa-C)-, lead(2+) (1:2), (OC-6-11)-	14402-61-0	Contains (regardless of intentional or impurities)	articles/ chemical products
652	4-Nonylphenol nonaethoxylate	14409-72-4	Intentional addition / 100ppm	articles/ chemical products
653	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, lead salt	14450-60-3	Contains (regardless of intentional or impurities)	articles/ chemical products
654	Mercury(II) selenite	14459-36-0	Contains (regardless of intentional or impurities)	articles/ chemical products
655	Lead acrylate	14466-01-4	Contains (regardless of intentional or impurities)	articles/ chemical products
656	Lead molybdenum oxide (Pb2MoO5)	14648-48-7	Intentional addition / 1%	articles/ chemical products
657	Lead 203	14687-25-3	Contains (regardless of intentional or impurities)	articles/ chemical products
658	Boric acid (HBO2), lead(2+) salt (2:1)	14720-53-7	Contains (regardless of intentional or impurities)	articles/ chemical products
659	Mercury, bis(phenyldiazene-carboxylic acid 2-phenylhydrazidato-N2,S)-, (T-4)-	14783-59-6	Contains (regardless of intentional or impurities)	articles/ chemical products
660	Nitric acid, mercury(1+) salt, dihydrate	14836-60-3	Contains (regardless of intentional or impurities)	articles/ chemical products
661	Plumbane, tetrakis(1-methylethyl)-	14846-40-3	Contains (regardless of intentional or impurities)	articles/ chemical products
662	Boric acid (H3BO3), monosodium salt	14890-53-0	Intentional addition / 1%	articles/ chemical products
663	Ethylene diamine tetraacetic acid disodium lead	14931-82-9	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
664	Lead fluoride (PbF)	14986-72-2	Contains (regardless of intentional or impurities)	articles/ chemical products
665	Mercury azide (Hg(N3))	14990-20-6	Intentional addition / 1%	articles/ chemical products
666	1,4-Benzenediamine, N,N'-bis(2-methylphenyl)-	15017-02-4	Contains (regardless of intentional or impurities)	articles/ chemical products
667	Mercury 194	15064-97-8	Contains (regardless of intentional or impurities)	articles/ chemical products
668	Lead 214	15067-28-4	Contains (regardless of intentional or impurities)	articles/ chemical products
669	Bicyclo[2.2.1]heptan-2-one, 1,7,7-trimethyl-3-(phenylmethylene)-	15087-24-8	Intentional addition / 1,000ppm	articles/ chemical products
671	Lead 212	15092-94-1	Contains (regardless of intentional or impurities)	articles/ chemical products
671	Mercury 193	15116-82-2	Contains (regardless of intentional or impurities)	articles/ chemical products
672	Perboric acid (H3BO2(O2)), monosodium salt	15120-21-5	Contains (regardless of intentional or impurities)	articles/ chemical products
673	Lead, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-1)-	15127-16-3	Contains (regardless of intentional or impurities)	articles/ chemical products
674	Cadmium sulfate hydrates	15244-25-6	Contains (regardless of intentional or impurities)	articles/ chemical products
675	1,3-Benzenediol, 2,4,6-trinitro-, lead salt	15245-44-0	Contains (regardless of intentional or impurities)	articles/ chemical products
676	Bis(2-ethylhexyl)phosphite(O,O')lead	15282-88-9	Contains (regardless of intentional or impurities)	articles/ chemical products
677	Lauric acid, lead salt	15306-30-6	Contains (regardless of intentional or impurities)	articles/ chemical products
678	9-Octadecenoic acid (Z)-, lead salt	15347-55-4	Contains (regardless of intentional or impurities)	articles/ chemical products
679	Lead acetate	15347-57-6	Contains (regardless of intentional or impurities)	articles/ chemical products
680	Hematoporphyrin mercury sodium salt	15375-94-7	Contains (regardless of intentional or impurities)	articles/ chemical products
681	Bromic acid, mercury(2+) salt	15384-08-4	Intentional addition / 1,000ppm	articles/ chemical products
682	Dimercure diiodide	15385-57-6	Contains (regardless of intentional or impurities)	articles/ chemical products
683	Mercury bromide (Hg2Br2)	15385-58-7	Contains (regardless of intentional or impurities)	articles/ chemical products
684	Mercury bis(4-chlorobenzoate)	15516-76-4	Contains (regardless of intentional or impurities)	articles/ chemical products
685	p-Toluic acid, lead(4+) salt	15516-84-4	Contains (regardless of intentional or impurities)	articles/ chemical products
686	Phosphonic acid, lead(2+) salt (2:1)	15521-60-5	Contains (regardless of intentional or impurities)	articles/ chemical products
687	Dioctyltin bis(2-ethylhexyl thioglycolate)	15571-58-1	Contains (regardless of intentional or impurities)	articles/ chemical products
688	Lead bromide (PbBr)	15576-47-3	Intentional addition / 1,000ppm	articles/ chemical products
689	(Thiophenoxy)triphenyllead	15590-77-9	Contains (regardless of intentional or impurities)	articles/ chemical products
690	Triethyl arsenate	15606-95-8	Contains (regardless of intentional or impurities)	articles/ chemical products
691	Octanoic acid, lead salt	15696-43-2	Contains (regardless of intentional or impurities)	articles/ chemical products
692	Plumbate(2-), [[N,N'-1,2-ethanediybis[N-(carboxymethyl)glycinato]](4-)-N,N',O,O',ON,ON]-, dipotassium, (OC-6-21)-	15708-49-3	Intentional addition	articles/ chemical products
693	Sulfuric acid, lead salt (1:?)	15739-80-7	Contains (regardless of intentional or impurities)	articles/ chemical products
694	Lead, bis(2-hydroxybenzoato-O1,O2)-, (T-4)-	15748-73-9	Contains (regardless of intentional or impurities)	articles/ chemical products
695	Lead 202	15752-86-0	Contains (regardless of intentional or impurities)	articles/ chemical products
696	Mercury 195	15756-15-7	Contains (regardless of intentional or impurities)	articles/ chemical products
697	Diacetoxydiethyl lead	15773-47-4	Contains (regardless of intentional or impurities)	articles/ chemical products
698	Lead(2+) decanoate	15773-52-1	Contains (regardless of intentional or impurities)	articles/ chemical products
699	Lead dioxanoate	15773-53-2	Contains (regardless of intentional or impurities)	articles/ chemical products
700	Dodecanoic acid, lead(2+) salt	15773-55-4	Contains (regardless of intentional or impurities)	articles/ chemical products
701	Lead dipalmitate	15773-56-5	Contains (regardless of intentional or impurities)	articles/ chemical products
702	Mercury, chloro[μ-(2,4-dinitroanilino)phenyl]-	15785-93-0	Contains (regardless of intentional or impurities)	articles/ chemical products
703	Lead 211	15816-77-0	Contains (regardless of intentional or impurities)	articles/ chemical products
704	Ethanedioic acid, lead salt	15843-48-8	Contains (regardless of intentional or impurities)	articles/ chemical products
705	Phosphoric acid, lead(2+) salt (1:1)	15845-52-0	Contains (regardless of intentional or impurities)	articles/ chemical products
706	Telluric acid (H2TeO3), lead(2+) salt (1:1)	15851-47-5	Contains (regardless of intentional or impurities)	articles/ chemical products
707	2,4,5-trichlorobiphenyl	15862-07-4	Contains (regardless of intentional or impurities)	articles/ chemical products
708	Silicic acid (H4SiO4), lead salt	15906-71-5	Contains (regardless of intentional or impurities)	articles/ chemical products
709	Lead benzoate	15907-04-7	Contains (regardless of intentional or impurities)	articles/ chemical products
710	1,1'-Biphenyl, 2,2',6,6'-tetrachloro-	15968-05-5	Contains (regardless of intentional or impurities)	articles/ chemical products
711	Phosphonic acid, lead salt	16038-76-9	Contains (regardless of intentional or impurities)	articles/ chemical products
712	Lead phosphate	16040-38-3	Contains (regardless of intentional or impurities)	articles/ chemical products
713	Mercury, methyl-	16056-34-1	Contains (regardless of intentional or impurities)	articles/ chemical products
714	Ethyl mercury	16056-37-4	Contains (regardless of intentional or impurities)	articles/ chemical products
715	Lead phthalate	16183-12-3	Contains (regardless of intentional or impurities)	articles/ chemical products
716	1,1'-Biphenyl, 3,3',5,5'-tetrabromo-	16400-50-3	Contains (regardless of intentional or impurities)	articles/ chemical products
717	1,1'-Biphenyl, 3,3'-dibromo-	16400-51-4	Contains (regardless of intentional or impurities)	articles/ chemical products
718	Diantimony lead tetroxide	16450-50-3	Contains (regardless of intentional or impurities)	articles/ chemical products
719	2,3-dichlorobiphenyl	16605-91-7	Contains (regardless of intentional or impurities)	articles/ chemical products
720	2,4,5-Trichlorobiphenyl	16608-02-3	Contains (regardless of intentional or impurities)	articles/ chemical products
721	Lead 200	16645-99-1	Contains (regardless of intentional or impurities)	articles/ chemical products
722	Lead 198	16646-00-7	Contains (regardless of intentional or impurities)	articles/ chemical products
723	Phenylmercuric thiocyanate	16751-55-6	Contains (regardless of intentional or impurities)	articles/ chemical products
724	Hexanoic acid, 2-ethyl-, lead salt (1:?)	16996-40-0	Contains (regardless of intentional or impurities)	articles/ chemical products
725	Lead linoleate	16996-51-3	Contains (regardless of intentional or impurities)	articles/ chemical products
726	1,2,3,6,7,8-Hexachloronaphthalene	17062-87-2	Contains (regardless of intentional or impurities)	articles/ chemical products
727	Hydroxymercuri- <i>o</i> -nitrophenol	17140-73-7	Contains (regardless of intentional or impurities)	articles/ chemical products
728	Lead 201	17239-87-1	Contains (regardless of intentional or impurities)	articles/ chemical products
729	4-(2-Nonyl)phenol	17404-66-9	Intentional addition / 1,000ppm	articles/ chemical products
730	Lead(II) maleate	17406-54-1	Contains (regardless of intentional or impurities)	articles/ chemical products
731	Bis(diethylthiocarbamate-S,S')lead	17549-30-3	Contains (regardless of intentional or impurities)	articles/ chemical products
732	Methanesulfonic acid, lead(2+) salt	17570-76-2	Contains (regardless of intentional or impurities)	articles/ chemical products
733	Lead, [μ-[1,2-benzenedicarboxylato(2-)-O1,O2]]di- <i>mu</i> -oxotri-, cyclo-	17976-43-1	Contains (regardless of intentional or impurities)	articles/ chemical products
734	Trimercure bis(2-ethylhexyl)phosphite	18211-85-3	Contains (regardless of intentional or impurities)	articles/ chemical products
735	2,3,4,5,6-pentachlorobiphenyl	18259-05-7	Contains (regardless of intentional or impurities)	articles/ chemical products
736	Lead, dipentyl-, diacetate	18279-20-4	Contains (regardless of intentional or impurities)	articles/ chemical products
737	Lead, dihexyl-, diacetate	18279-21-5	Contains (regardless of intentional or impurities)	articles/ chemical products
738	Stannane, triphenyl[(2,2,4,4-tetramethylvaleryl)oxy]-	18380-71-7	Contains (regardless of intentional or impurities)	articles/ chemical products
739	Stannane, [(2-isopropyl-2,3-dimethylbutyl)oxy]triphenyl-	18380-72-8	Contains (regardless of intentional or impurities)	articles/ chemical products
740	Di(phenylmercury)ammonium propionate	18467-88-4	Contains (regardless of intentional or impurities)	articles/ chemical products
741	Chromium, ion (Cr6+)	18540-29-9	Contains (regardless of intentional or impurities)	articles/ chemical products
742	1,2-Benzenedicarboxylic acid, lead(2+) salt	18608-34-9	Contains (regardless of intentional or impurities)	articles/ chemical products
743	Bromo(2-hydroxypropyl)mercury	18832-83-2	Contains (regardless of intentional or impurities)	articles/ chemical products
744	Lead dilactate	18917-82-3	Contains (regardless of intentional or impurities)	articles/ chemical products
745	Bis(lactato-O1,O2)mercury	18917-83-4	Contains (regardless of intentional or impurities)	articles/ chemical products
746	(lactato-O1,O2)mercury	18918-06-4	Contains (regardless of intentional or impurities)	articles/ chemical products
747	Undecane, 1,1,1,3,5,7,9,11,11-nonachloro-	18993-26-5	Contains (regardless of intentional or impurities)	articles/ chemical products
748	Lead dimethylthiocarbamate	19010-66-3	Contains (regardless of intentional or impurities)	articles/ chemical products
749	Lead maleate	19136-34-6	Contains (regardless of intentional or impurities)	articles/ chemical products
750	[μ-[Metasilicato(2-)-O,O]]bis(2-methoxyethyl)dimercure	19367-79-4	Contains (regardless of intentional or impurities)	articles/ chemical products
751	1,3-Isobenzofurandione, hexahydro-5-methyl-	19438-60-9	Contains (regardless of intentional or impurities)	articles/ chemical products
752	Mercury, (acetato-O)4-[4-(4-(dimethylamino)phenyl)azo]phenyl]-	19447-62-2	Contains (regardless of intentional or impurities)	articles/ chemical products
753	Lead palmitate	19528-55-3	Contains (regardless of intentional or impurities)	articles/ chemical products
754	7,11-Metheno-11H,13H-tetrazolo[1,5-c][1,7,3,5,2,6]dioxadiazadipumbacyclododecine, 5,5,13,13-tetrahydro-4,5-dihydro-4,8,10,15-tetranitro-	19651-80-0	Contains (regardless of intentional or impurities)	articles/ chemical products
755	Bis(4-bromophenyl)mercury	19719-72-3	Contains (regardless of intentional or impurities)	articles/ chemical products
756	Lead hydroxide (Pb(OH)2)	19783-14-3	Contains (regardless of intentional or impurities)	articles/ chemical products
757	1,2,3,4-Tetrachloronaphthalene	20020-02-4	Contains (regardless of intentional or impurities)	articles/ chemical products
758	Phosphordithioate O,O-bis(1,3-dimethylbutyl)-, lead salt	20383-42-0	Contains (regardless of intentional or impurities)	articles/ chemical products
759	Lead myristate	20403-41-2	Contains (regardless of intentional or impurities)	articles/ chemical products
760	Decanoic acid, lead salt	20403-42-3	Contains (regardless of intentional or impurities)	articles/ chemical products
761	Ethanol, 2-(4-moxyphenoxy)ethoxy-	20427-84-3	Intentional addition / 1,000ppm	articles/ chemical products
762	Phenol, lead(2+) salt	20534-94-5	Contains (regardless of intentional or impurities)	articles/ chemical products
763	Mercury selenide (HgSe)	20601-83-6	Contains (regardless of intentional or impurities)	articles/ chemical products
764	Benzylidimercury	20632-18-2	Contains (regardless of intentional or impurities)	articles/ chemical products
765	Mercury, oxo-, antimony salt (1:1)	20720-76-7	Contains (regardless of intentional or impurities)	articles/ chemical products
766	Mercury, di-3-pyridyl-	20738-78-7	Contains (regardless of intentional or impurities)	articles/ chemical products
767	Lead cyanamide	20837-86-9	Contains (regardless of intentional or impurities)	articles/ chemical products
768	Lead cyanamidate	20890-10-2	Contains (regardless of intentional or impurities)	articles/ chemical products
769	Lead 2,4-dihydroxybenzoate	20936-32-7	Contains (regardless of intentional or impurities)	articles/ chemical products
770	Cadmium hydroxide (Cd(OH)2)	21041-95-2	Contains (regardless of intentional or impurities)	articles/ chemical products
771	2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9-Heptafluorooctanoic acid, sodium salt	21049-39-8	Contains (regardless of intentional or impurities)	articles/ chemical products
772	Mercury, (acetato-O)4-(diethylamino)phenyl-	21109-99-9	Contains (regardless of intentional or impurities)	articles/ chemical products
773	Heptanoic acid, lead salt	21180-26-7	Contains (regardless of intentional or impurities)	articles/ chemical products
774	Lead bis(2,2,6,6-tetramethyl-3,5-heptanedionate)	21319-43-7	Contains (regardless of intentional or impurities)	articles/ chemical products
775	Mercury, (acetato-O)2(2,3,5,6-tetramethylphenyl)-	21450-81-7	Contains (regardless of intentional or impurities)	articles/ chemical products
776	Lead, bis(6,6,7,7,8,8,8-heptafluoro-2,2-dimethyl-3,5-octanedionato-βeta.O.βeta.O)-, (T-4)-	21600-78-2	Contains (regardless of intentional or impurities)	articles/ chemical products
777	Zinc mercury chromate	22323-45-1	Contains (regardless of intentional or impurities)	articles/ chemical products
778	Disilicic acid, lead(2+) salt (1:3)	22438-69-3	Contains (regardless of intentional or impurities)	articles/ chemical products
779	Mercury(1+), aminophenyl-, acetate	22450-90-4	Contains (regardless of intentional or impurities)	articles/ chemical products
780	Boric acid (H3BO3), disodium salt	22454-04-2	Intentional addition / 1%	articles/ chemical products
781	Lead silicate	22569-74-0	Contains (regardless of intentional or impurities)	articles/ chemical products
782	Tin, dibutylbis(2,4-pentanedionato-O)-, (OC-6-11)-	22673-19-4	Contains (regardless of intentional or impurities)	articles/ chemical products
783	Glycine, N,N'-1,2-ethanediybis[N-(carboxymethyl)-, lead(2+) sodium salt (1:1:2)	22804-40-1	Contains (regardless of intentional or impurities)	articles/ chemical products
784	Methylmercury(II) cation	22967-92-6	Contains (regardless of intentional or impurities)	articles/ chemical products
785	Pentachlorophenyl N-[(4-methoxyphenyl)methoxy]carbonyl-L-serinate	23234-97-1	Contains (regardless of intentional or impurities)	articles/ chemical products
786	[2,2,2'-nitrotri(ethano)-N,O,O']phenylmercury lactate	23319-66-6	Contains (regardless of intentional or impurities)	articles/ chemical products
787	Mercury, bromo(2-hydroxyethyl)-	23471-13-8	Contains (regardless of intentional or impurities)	articles/ chemical products
788	Mercury, bromo(methoxycarbonyl)-	23471-23-0	Contains (regardless of intentional or impurities)	articles/ chemical products
789	Bromo(2-hydroxyethyl)mercury ammonia salt	23483-74-1	Contains (regardless of intentional or impurities)	articles/ chemical products
790	Di-tert-butylmercury	23587-90-8	Contains (regardless of intentional or impurities)	articles/ chemical products
791	Hexanoic acid, 3,5,5-trimethyl-, lead salt	23621-79-6	Contains (regardless of intentional or impurities)	articles/ chemical products
792	5,5,12,12-Tetrabutyl-7,10-dioxo-6,11-dioxo-5,12-distannahehexadec-8-ene	24291-45-0	Contains (regardless of intentional or impurities)	articles/ chemical products
793	Disoamylmercury	24423-68-5	Contains (regardless of intentional or impurities)	articles/ chemical products
794	Mercury, chloro(2-hydroxy-5-nitrophenyl)-	24579-90-6	Contains (regardless of intentional or impurities)	articles/ chemical products
795	Chloro(2-hydroxy-3,5-dinitrophenyl)mercury	24579-91-7	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
796	Chromic acid (H2CrO4), chromium(3+) salt (3:2)	24613-89-6	Contains (regardless of intentional or impurities)	articles/ chemical products
797	Mercury, [mu.-[dodecylbutanedioate(2-)-O]-O]diphenylid-	24806-32-4	Contains (regardless of intentional or impurities)	articles/ chemical products
798	Phosphonic acid, lead(2+) salt	24824-71-3	Contains (regardless of intentional or impurities)	articles/ chemical products
799	Phenol, dimethyl-, phosphate (3:1)	25195-23-1	Contains (regardless of intentional or impurities)	articles/ chemical products
800	Formaldehyde, polymer with benzenamine	25214-70-4	Intentional addition / 1,000ppm	articles/ chemical products
801	trichlorobiphenyl	25323-68-6	Contains (regardless of intentional or impurities)	articles/ chemical products
802	Pentachlorobiphenyl	25429-29-2	Contains (regardless of intentional or impurities)	articles/ chemical products
803	Carbonic acid, lead(2+) salt (1:?)	25510-11-6	Contains (regardless of intentional or impurities)	articles/ chemical products
804	dichlorobiphenyl	25512-42-9	Contains (regardless of intentional or impurities)	articles/ chemical products
805	1,3-isobenzofurandione, hexahydromethyl-	25550-51-0	Contains (regardless of intentional or impurities)	articles/ chemical products
806	2,3-dichlorobiphenyl	25559-90-6	Contains (regardless of intentional or impurities)	articles/ chemical products
807	Cyclododecane, hexabromo-	25597-99-4	Contains (regardless of intentional or impurities)	articles/ chemical products
808	Lead iodate	25659-31-8	Contains (regardless of intentional or impurities)	articles/ chemical products
809	Lead sulfite	25668-92-6	Contains (regardless of intentional or impurities)	articles/ chemical products
810	Lead picrate	25721-38-4	Contains (regardless of intentional or impurities)	articles/ chemical products
811	Silicic acid (H4SiO4), lead(2+) salt	25725-28-4	Contains (regardless of intentional or impurities)	articles/ chemical products
812	boric acid (H3BO3), sodium salt, hydrate	25747-83-5	1,000ppm	articles/ chemical products
813	Silicate(2-), hexafluoro-, lead(2+) (1:1)	25808-74-6	Contains (regardless of intentional or impurities)	articles/ chemical products
814	Phenol, 2-(2H-benzotriazol-2-yl)-4,6-bis(1,1-dimethylpropyl)-	25973-55-1	Intentional addition / 100ppm	articles/ chemical products
815	Phenol, lead salt	25987-03-5	Contains (regardless of intentional or impurities)	articles/ chemical products
816	Poly(oxy-1,2-ethanediylo), alpha-(4-nonylphenyl)-omega-hydroxy-	26027-38-3	Contains (regardless of intentional or impurities)	articles/ chemical products
817	Mercury, iodo(4-methylphenyl)-	26037-72-9	Contains (regardless of intentional or impurities)	articles/ chemical products
818	Tributyltin abietate	26239-64-5	Contains (regardless of intentional or impurities)	articles/ chemical products
819	Thiosulphuric acid, lead salt	26265-85-6	Contains (regardless of intentional or impurities)	articles/ chemical products
820	Mercury(II) bromate	26522-91-8	Intentional addition / 1%	articles/ chemical products
821	Ethylmercuric urea	26535-94-4	Contains (regardless of intentional or impurities)	articles/ chemical products
822	Phenol, 4-isonyl-	26543-97-5	Intentional addition / 1,000ppm	articles/ chemical products
823	Mercury, (neodecanoato-O)phenyl-	26545-49-3	Contains (regardless of intentional or impurities)	articles/ chemical products
824	hexachlorobiphenyl	26601-64-9	Contains (regardless of intentional or impurities)	articles/ chemical products
825	Mercury(2+) chloroacetate	26719-07-3	Contains (regardless of intentional or impurities)	articles/ chemical products
826	tetrachlorobiphenyl	26914-33-0	Contains (regardless of intentional or impurities)	articles/ chemical products
827	Phenol, 4-isododecyl-	27147-75-7	1,000ppm	articles/ chemical products
828	Diphenyl[mu.-[tetrapropenyl]succinato(2-)-O,O]dimercury	27236-65-3	Contains (regardless of intentional or impurities)	articles/ chemical products
829	Lead neodecanoate	27253-28-7	Contains (regardless of intentional or impurities)	articles/ chemical products
830	Isononanoic acid, lead salt	27253-41-4	Contains (regardless of intentional or impurities)	articles/ chemical products
831	Oxycyclorane	27304-13-8	Contains (regardless of intentional or impurities)	articles/ chemical products
832	Chlorobiphenyl	27323-18-8	Contains (regardless of intentional or impurities)	articles/ chemical products
833	(dihydroxyphenyl)phenylmercury	27360-58-3	Contains (regardless of intentional or impurities)	articles/ chemical products
834	1,4-Benzenediamine, N,N'-bis(methylphenyl)-	27417-40-9	Contains (regardless of intentional or impurities)	articles/ chemical products
835	Phenol, 4-isododecyl-	27459-10-5	1,000ppm	articles/ chemical products
836	ar,ar'-Dibromobiphenyl	27479-65-8	Contains (regardless of intentional or impurities)	articles/ chemical products
837	Lead 199	27486-00-6	Contains (regardless of intentional or impurities)	articles/ chemical products
838	Benzoic acid, methyl-, lead(2+) salt	27496-91-9	Contains (regardless of intentional or impurities)	articles/ chemical products
839	Mercury fluoride	27575-47-9	Contains (regardless of intentional or impurities)	articles/ chemical products
840	[2-ethylhexyl hydrogen maleato-O]phenylmercury	27605-30-7	Contains (regardless of intentional or impurities)	articles/ chemical products
841	Cobaltate(2-), tetrakis(thiocyanato-N)-, mercury(2+) (1:1), (T-4)-	27685-51-4	Contains (regardless of intentional or impurities)	articles/ chemical products
842	Phenol, pentachloro-, sodium salt, decahydrate	27735-63-3	Contains (regardless of intentional or impurities)	articles/ chemical products
843	Phenol, pentachloro-, sodium salt, monohydrate	27735-64-4	Contains (regardless of intentional or impurities)	articles/ chemical products
844	1,1'-Biphenyl, nonabromo-	27753-52-2	Contains (regardless of intentional or impurities)	articles/ chemical products
845	1,1'-Biphenyl, ar,ar',ar,ar',ar,ar',ar,ar'-octabromo-	27858-07-7	Contains (regardless of intentional or impurities)	articles/ chemical products
846	Niobate(2-), heptachloro-, lead(2+)	27923-60-0	Contains (regardless of intentional or impurities)	articles/ chemical products
847	20-(4-Nonylphenoxy)-3,6,9,12,15,18-hexaoxaicosan-1-ol	27942-27-4	Intentional addition / 1,000ppm	articles/ chemical products
848	Phenylmercury salicylate	28086-13-7	Contains (regardless of intentional or impurities)	articles/ chemical products
849	Tetracosanoic acid, lead(II)	28267-01-8	Contains (regardless of intentional or impurities)	articles/ chemical products
850	Heptachloro-1,1'-biphenyl	28285-71-2	Contains (regardless of intentional or impurities)	articles/ chemical products
851	Naphthalene, dichloro-	28699-88-9	Contains (regardless of intentional or impurities)	articles/ chemical products
852	1,4-Benzenediamine, N,N'-bis(dimethylphenyl)-	28726-30-9	Contains (regardless of intentional or impurities)	articles/ chemical products
853	Mercuric oxyluoride	28953-04-0	Contains (regardless of intentional or impurities)	articles/ chemical products
854	Perchlorophenyl 5-oxo-L-prolineate	28990-85-4	Contains (regardless of intentional or impurities)	articles/ chemical products
855	(2,2-Diphenyl-2-hydroxyethyl)mercuryacetate	29053-02-9	Contains (regardless of intentional or impurities)	articles/ chemical products
856	1-Octanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-heptadecafluoro-, ammonium salt	29081-56-9	Contains (regardless of intentional or impurities)	articles/ chemical products
857	Ethyl(methylmercury	29138-86-1	Contains (regardless of intentional or impurities)	articles/ chemical products
858	1-Octanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-heptadecafluoro-, lithium salt	29457-72-5	Contains (regardless of intentional or impurities)	articles/ chemical products
859	Lead sebacate	29473-77-6	Contains (regardless of intentional or impurities)	articles/ chemical products
860	Lead didocosanoate	29597-84-0	Contains (regardless of intentional or impurities)	articles/ chemical products
861	Lead ferrocyanide dihydrate	29729-00-8	Contains (regardless of intentional or impurities)	articles/ chemical products
862	Cadmium mercury telluride ((Cd,Hg)Te)	29870-72-2	Contains (regardless of intentional or impurities)	articles/ chemical products
863	Lead, bis(diisopropylthiocarbamate)-	30051-53-7	Contains (regardless of intentional or impurities)	articles/ chemical products
864	ar,ar,ar-trichlorobiphenyl	30065-81-9	Contains (regardless of intentional or impurities)	articles/ chemical products
865	Silicic acid (H2Si2O5), lead(2+) salt (1:1)	30719-10-9	Contains (regardless of intentional or impurities)	articles/ chemical products
866	Phenol, 4-(1-ethyl-1,2-dimethylpropyl)-	30784-27-1	Intentional addition	articles/ chemical products
867	Phenol, 4-(1,1-dimethylheptyl)-	30784-30-6	Intentional addition / 1,000ppm	articles/ chemical products
868	Phenol, 4-(1,1-dimethylpentyl)-	30784-31-7	Intentional addition	articles/ chemical products
869	Phenol, 4-(1-ethyl-1-methylbutyl)-	30784-32-8	Intentional addition	articles/ chemical products
870	Fatty acids, polymers with alkylamines, cyclopentadiene, dicyclopentadiene, gilsorite, lead oxide and linseed oil	30873-69-9	Contains (regardless of intentional or impurities)	articles/ chemical products
871	Mercury cyanide hydroxide (Hg(CN)(OH))	31065-88-0	Contains (regardless of intentional or impurities)	articles/ chemical products
872	Cadmium sulphate	31119-53-6	Contains (regardless of intentional or impurities)	articles/ chemical products
873	Benzene, 1,1'-oxybis(tribromo-	31153-30-7	Contains (regardless of intentional or impurities)	articles/ chemical products
874	(metaborato-O)phenylmercury	31224-71-2	Contains (regardless of intentional or impurities)	articles/ chemical products
875	Tetrachloro(tetrachlorophenyl)benzene	31472-83-0	Contains (regardless of intentional or impurities)	articles/ chemical products
876	2,3',4,4',5'-pentachlorobiphenyl	31508-00-6	Contains (regardless of intentional or impurities)	articles/ chemical products
877	1,3,5,8-Tetrachloronaphthalene	31604-28-1	Contains (regardless of intentional or impurities)	articles/ chemical products
878	Phenol, p-isonyl-, phosphate (3:1)	31631-13-7	Intentional addition / 1,000ppm	articles/ chemical products
879	[naphthoato(1-)-O]phenylmercury	31632-68-5	Contains (regardless of intentional or impurities)	articles/ chemical products
880	6,11-Dioxo-5,12-distannahexadecane, 8,9-dibromo-5,5,12,12-tetrabutyl-7,10-dioxo-, (R+S)-	31732-71-5	Contains (regardless of intentional or impurities)	articles/ chemical products
881	Lead dimyristate	32112-52-0	Contains (regardless of intentional or impurities)	articles/ chemical products
882	Naphthalene, heptachloro-	32241-08-0	Contains (regardless of intentional or impurities)	articles/ chemical products
883	Phenylmercury dimethylthiocarbamate	32407-99-1	Contains (regardless of intentional or impurities)	articles/ chemical products
884	Benzene, 1,1'-oxybis-, pentaboro derivative	32534-81-9	Contains (regardless of intentional or impurities)	articles/ chemical products
885	2,3',4,4'-tetrachlorobiphenyl	32598-10-0	Contains (regardless of intentional or impurities)	articles/ chemical products
886	2,3',4,5'-tetrachlorobiphenyl	32598-11-1	Contains (regardless of intentional or impurities)	articles/ chemical products
887	2,4,4',6'-tetrachlorobiphenyl	32598-12-2	Contains (regardless of intentional or impurities)	articles/ chemical products
888	3,4,3',4'-Tetrachlorobiphenyl	32598-13-3	Contains (regardless of intentional or impurities)	articles/ chemical products
889	2,3',3',4,4'-pentachlorobiphenyl	32598-14-4	Contains (regardless of intentional or impurities)	articles/ chemical products
890	Tetramethylammonium perfluorooctanoate	32609-65-7	Intentional addition / 1%	articles/ chemical products
891	2,4,4',5'-hexachlorobiphenyl	32690-93-0	Contains (regardless of intentional or impurities)	articles/ chemical products
892	3,4,5,3',4',5'-Hexachlorobiphenyl	32774-16-6	Contains (regardless of intentional or impurities)	articles/ chemical products
893	Mercury, (dihydrogen phosphato)methyl-	32787-44-3	Contains (regardless of intentional or impurities)	articles/ chemical products
894	Triethanolamine-pentachlorophenolate	32918-79-3	Contains (regardless of intentional or impurities)	articles/ chemical products
895	Mercury, hydroxyisopropyl-	33020-34-7	Contains (regardless of intentional or impurities)	articles/ chemical products
896	2,3,4,4'-tetrachlorobiphenyl	33025-41-1	Contains (regardless of intentional or impurities)	articles/ chemical products
897	ar,ar'-dichlorobiphenyl	33039-81-5	Contains (regardless of intentional or impurities)	articles/ chemical products
898	2',3',3',4,4',6,6'-octachlorobiphenyl	33091-17-7	Contains (regardless of intentional or impurities)	articles/ chemical products
899	Phenol, 4-(1,1,3-trimethylbutyl)-	33104-11-9	Intentional addition	articles/ chemical products
900	2,6-dichlorobiphenyl	33146-45-1	Contains (regardless of intentional or impurities)	articles/ chemical products
901	beta.-Endosulfan	33213-85-9	Contains (regardless of intentional or impurities)	articles/ chemical products
902	2,4-dichlorobiphenyl	33284-50-3	Contains (regardless of intentional or impurities)	articles/ chemical products
903	3,3',5,5'-tetrachlorobiphenyl	33284-52-5	Contains (regardless of intentional or impurities)	articles/ chemical products
904	2,3,4,5-tetrachlorobiphenyl	33284-53-6	Contains (regardless of intentional or impurities)	articles/ chemical products
905	2,3,5,6-tetrachlorobiphenyl	33284-54-7	Contains (regardless of intentional or impurities)	articles/ chemical products
906	Lead dilinoleate	33627-12-2	Contains (regardless of intentional or impurities)	articles/ chemical products
907	Bis(+-lactato)mercury	33724-17-3	Contains (regardless of intentional or impurities)	articles/ chemical products
908	Mercury, [2,5-dichloro-3,6-dihydroxy-2,5-cyclohexadiene-1,4-dionato(2-)-O]0,0]-	33770-60-4	Contains (regardless of intentional or impurities)	articles/ chemical products
909	Mercury(II) nitrate hydrate	33960-08-6	Contains (regardless of intentional or impurities)	articles/ chemical products
910	2,2',4,4',6,6'-hexachlorobiphenyl	33979-03-2	Contains (regardless of intentional or impurities)	articles/ chemical products
911	Lead dibromate	34018-28-5	Contains (regardless of intentional or impurities)	articles/ chemical products
912	p-Nonylphenol hexaethoxylate	34166-38-6	Intentional addition / 1,000ppm	articles/ chemical products
913	o-Toluic acid, lead(4+) salt	34295-32-4	Contains (regardless of intentional or impurities)	articles/ chemical products
914	2,3,6,7-Tetrachloronaphthalene	34588-40-4	Contains (regardless of intentional or impurities)	articles/ chemical products
915	2,5-dichlorobiphenyl	34883-39-1	Contains (regardless of intentional or impurities)	articles/ chemical products
916	3,5-dichlorobiphenyl	34883-41-5	Contains (regardless of intentional or impurities)	articles/ chemical products
917	PCB 8	34883-43-7	Contains (regardless of intentional or impurities)	articles/ chemical products
918	Methanethiol, lead(2+) salt	35029-96-0	Contains (regardless of intentional or impurities)	articles/ chemical products
919	2,4,5,2',4',5'-Hexachlorobiphenyl	35065-27-1	Contains (regardless of intentional or impurities)	articles/ chemical products
920	2,2',3,4,4',5'-hexachlorobiphenyl	35065-28-2	Contains (regardless of intentional or impurities)	articles/ chemical products
921	2,2',3,4,4',5,5'-heptachlorobiphenyl	35065-29-3	Contains (regardless of intentional or impurities)	articles/ chemical products
922	2,2',3,3',4,4',5'-heptachlorobiphenyl	35065-30-6	Contains (regardless of intentional or impurities)	articles/ chemical products
923	Pentachlorophenol, compound with [1R-(1.alpha.,4.alpha.,10.alpha.)]-1,2,3,4,4a,9,10,10a-octahydro-7-isopropyl-1,4a-dimethylphenanthrene-1-methylamine (1:1)	35109-57-0	Contains (regardless of intentional or impurities)	articles/ chemical products
924	Lead cyanamide	35112-70-0	Contains (regardless of intentional or impurities)	articles/ chemical products
925	Heptabromo(1,1'-biphenyl	35194-78-6	Contains (regardless of intentional or impurities)	articles/ chemical products
926	Lead oxide (Pb2O2)	35229-41-5	Intentional addition / 1,000ppm	articles/ chemical products
927	Orthoboric acid, lead(2+) salt	35488-15-8	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
928	2,4,6-trichlorobiphenyl	35693-92-6	Contains (regardless of intentional or impurities)	articles/ chemical products
929	PCB 52	35693-99-3	Contains (regardless of intentional or impurities)	articles/ chemical products
930	2,2',3,3',5,5'-hexachlorobiphenyl	35694-04-3	Contains (regardless of intentional or impurities)	articles/ chemical products
931	2,2',3,4,4',5-hexachlorobiphenyl	35694-06-5	Contains (regardless of intentional or impurities)	articles/ chemical products
932	2,2',3,3',4,4',5,5'-octachlorobiphenyl	35694-08-7	Contains (regardless of intentional or impurities)	articles/ chemical products
933	Lead bis(3,5,5-trimethylhexanoate)	35837-70-8	Contains (regardless of intentional or impurities)	articles/ chemical products
934	Benzene, 1,1'-oxybis[2,4,6-tribromo-	35894-94-5	Contains (regardless of intentional or impurities)	articles/ chemical products
935	Undecane, octachloro-	36312-81-9	Contains (regardless of intentional or impurities)	articles/ chemical products
936	Hexabromobiphenyl	36355-01-8	Contains (regardless of intentional or impurities)	articles/ chemical products
937	2,2',4,4',5,6'-Hexabromobiphenyl	36402-15-0	Contains (regardless of intentional or impurities)	articles/ chemical products
938	Phenol, 2-(2H-benzotriazol-2-yl)-4-[(1,1-dimethylethyl)-6-(1-methylpropyl)-	36437-97-3	Intentional addition / 100ppm	articles/ chemical products
939	1-Propenal, 2,2-dimethyl-, tribromo derivative	36437-97-5	Intentional addition / 100ppm	articles/ chemical products
940	Benzene, 1,1'-oxybis-, hexabromo derivative	36483-80-0	Contains (regardless of intentional or impurities)	articles/ chemical products
941	Lead, bis(dipentylcarbamodithioato-S,S')-, (1-4)-	36501-84-5	Contains (regardless of intentional or impurities)	articles/ chemical products
942	2,2',3,4'-tetrachlorobiphenyl	36559-22-5	Contains (regardless of intentional or impurities)	articles/ chemical products
943	(±)-1,7,7-Trimethyl-3-[(4-methylphenyl)methylene]bicyclo[2,2,1]heptan-2-one	36861-47-9	1,000ppm	articles/ chemical products
944	Pentachlorophenyl salicylate	36894-69-1	Contains (regardless of intentional or impurities)	articles/ chemical products
945	Mercury cyanide (Hg(CN))	37020-93-2	Contains (regardless of intentional or impurities)	articles/ chemical products
946	Lead ruthenium oxide (PbRuO3)	37194-88-0	Contains (regardless of intentional or impurities)	articles/ chemical products
947	Poly(oxy-1,2-ethanedivyl), alpha-(isononylphenyl)-omega-hydroxy-	37205-87-1	Intentional addition / 1,000ppm	articles/ chemical products
948	Magnesium amalgam	37237-15-3	Contains (regardless of intentional or impurities)	articles/ chemical products
949	Dilead dirhodium heptaoxide	37240-96-3	Contains (regardless of intentional or impurities)	articles/ chemical products
950	Perboric acid (HBO(O2)), sodium salt, tetrahydrate	37244-98-7	Contains (regardless of intentional or impurities)	articles/ chemical products
951	Mercury iodide	37320-91-5	Contains (regardless of intentional or impurities)	articles/ chemical products
952	Potassium-mercury amalgam	37340-23-1	Contains (regardless of intentional or impurities)	articles/ chemical products
953	Kanechlor 300	37353-63-2	Contains (regardless of intentional or impurities)	articles/ chemical products
954	2,2',5-trichlorobiphenyl	37680-65-2	Contains (regardless of intentional or impurities)	articles/ chemical products
955	2,2',4-trichlorobiphenyl	37680-66-3	Contains (regardless of intentional or impurities)	articles/ chemical products
956	2,3',5'-trichlorobiphenyl	37680-68-5	Contains (regardless of intentional or impurities)	articles/ chemical products
957	3,3',4-trichlorobiphenyl	37680-69-6	Contains (regardless of intentional or impurities)	articles/ chemical products
958	2,2',4,5,5'-pentachlorobiphenyl	37680-73-2	Contains (regardless of intentional or impurities)	articles/ chemical products
959	Phenol, 4-(1,1-diethylpropyl)-	37872-24-5	Intentional addition	articles/ chemical products
960	Mercurous azide	38232-63-2	Contains (regardless of intentional or impurities)	articles/ chemical products
961	2,2',3,5,6-pentachlorobiphenyl	38379-99-6	Contains (regardless of intentional or impurities)	articles/ chemical products
962	2,2',4,4',5-pentachlorobiphenyl	38380-01-7	Contains (regardless of intentional or impurities)	articles/ chemical products
963	2,2',3,4,5-pentachlorobiphenyl	38380-02-8	Contains (regardless of intentional or impurities)	articles/ chemical products
964	2,3,3',4',6-pentachlorobiphenyl	38380-03-9	Contains (regardless of intentional or impurities)	articles/ chemical products
965	2,2',3,4',5,6-hexachlorobiphenyl	38380-04-0	Contains (regardless of intentional or impurities)	articles/ chemical products
966	2,2',3,3',4,6-Hexachlorobiphenyl	38380-05-1	Contains (regardless of intentional or impurities)	articles/ chemical products
967	PCB 128	38380-07-3	Contains (regardless of intentional or impurities)	articles/ chemical products
968	2,3',3',4,4',5-hexachlorobiphenyl	38380-08-4	Contains (regardless of intentional or impurities)	articles/ chemical products
969	PCB 136	38411-22-2	Contains (regardless of intentional or impurities)	articles/ chemical products
970	2,2',3,3',4,5,6-heptachlorobiphenyl	38411-25-5	Contains (regardless of intentional or impurities)	articles/ chemical products
971	1,1'-Biphenyl, 2,3,4,5,6-pentabromo-	38421-62-4	Contains (regardless of intentional or impurities)	articles/ chemical products
972	2,2',6-trichlorobiphenyl	38444-73-4	Contains (regardless of intentional or impurities)	articles/ chemical products
973	2,3',6-trichlorobiphenyl	38444-76-7	Contains (regardless of intentional or impurities)	articles/ chemical products
974	2,4',6-trichlorobiphenyl	38444-77-8	Contains (regardless of intentional or impurities)	articles/ chemical products
975	2,2',3-trichlorobiphenyl	38444-78-9	Contains (regardless of intentional or impurities)	articles/ chemical products
976	2,3',5-trichlorobiphenyl	38444-81-4	Contains (regardless of intentional or impurities)	articles/ chemical products
977	2,3,3'-trichlorobiphenyl	38444-84-7	Contains (regardless of intentional or impurities)	articles/ chemical products
978	2,3,4'-trichlorobiphenyl	38444-85-8	Contains (regardless of intentional or impurities)	articles/ chemical products
979	2,3,4-trichlorobiphenyl	38444-86-9	Contains (regardless of intentional or impurities)	articles/ chemical products
980	3,3',5-trichlorobiphenyl	38444-87-0	Contains (regardless of intentional or impurities)	articles/ chemical products
981	3,4',5-trichlorobiphenyl	38444-88-1	Contains (regardless of intentional or impurities)	articles/ chemical products
982	3,4,4'-trichlorobiphenyl	38444-89-2	Contains (regardless of intentional or impurities)	articles/ chemical products
983	2,2',3,3'-tetrachlorobiphenyl	38444-93-8	Contains (regardless of intentional or impurities)	articles/ chemical products
984	Lead isothalate	38787-87-0	Contains (regardless of intentional or impurities)	articles/ chemical products
985	Lead hydroxide	38345-91-0	Contains (regardless of intentional or impurities)	articles/ chemical products
986	Lead sulfide	38377-56-5	Contains (regardless of intentional or impurities)	articles/ chemical products
987	Lead chloride silicate	38390-00-6	Contains (regardless of intentional or impurities)	articles/ chemical products
988	Tin alloy with 88% tin, 8% lead, 4% copper and 0.5% antimony	39412-44-7	Contains (regardless of intentional or impurities)	articles/ chemical products
989	2,2',4,4',6-pentachlorobiphenyl	39485-83-1	Contains (regardless of intentional or impurities)	articles/ chemical products
990	2,3',3',4,4',5,5'-heptachlorobiphenyl	39635-31-9	Contains (regardless of intentional or impurities)	articles/ chemical products
991	2,3',3',5,5'-pentachlorobiphenyl	39635-32-0	Contains (regardless of intentional or impurities)	articles/ chemical products
992	3,2',4,5,5'-pentachlorobiphenyl	39635-33-1	Contains (regardless of intentional or impurities)	articles/ chemical products
993	2,3',3',4',5,5'-hexachlorobiphenyl	39635-34-2	Contains (regardless of intentional or impurities)	articles/ chemical products
994	2,3',3',4,5,5'-hexachlorobiphenyl	39635-35-3	Contains (regardless of intentional or impurities)	articles/ chemical products
995	Tetrabromodiphenyl ethers	40088-47-9	Contains (regardless of intentional or impurities)	articles/ chemical products
996	2,2',3,3',4,5,6-heptachlorobiphenyl	40186-70-7	Contains (regardless of intentional or impurities)	articles/ chemical products
997	2,2',3,3',4,5,6,6'-octachlorobiphenyl	40186-71-8	Contains (regardless of intentional or impurities)	articles/ chemical products
998	2,2',3,3',4,4',5,5,6'-nonachlorobiphenyl	40186-72-9	Contains (regardless of intentional or impurities)	articles/ chemical products
999	Bromotriethyllead	41141-89-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1000	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, neodymium(3+) salt (3:1)	41184-65-0	Intentional addition / 1,000ppm	articles/ chemical products
1001	Nonanoic acid, lead salt	41234-07-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1002	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, yttrium(3+) salt (3:1)	41242-12-0	Intentional addition / 1,000ppm	articles/ chemical products
1003	2,2',3,4,5,6-hexachlorobiphenyl	41411-61-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1004	2,3,3',4',5,6-hexachlorobiphenyl	41411-62-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1005	2,3,4,4',5,6-hexachlorobiphenyl	41411-63-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1006	2,3,3',4,4',5,6-heptachlorobiphenyl	41411-64-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1007	Lead beta-resorcylate	41453-50-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1008	2,2',3,5'-tetrachlorobiphenyl	41464-39-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1009	2,2',4,5'-tetrachlorobiphenyl	41464-40-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1010	2,2',5,6'-tetrachlorobiphenyl	41464-41-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1011	2,3',5,5'-tetrachlorobiphenyl	41464-42-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1012	2,3,3',4'-tetrachlorobiphenyl	41464-43-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1013	2,3',4',6-tetrachlorobiphenyl	41464-46-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1014	2,2',3,6'-tetrachlorobiphenyl	41464-47-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1015	3,3',4,5'-tetrachlorobiphenyl	41464-48-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1016	2,3,3',5'-tetrachlorobiphenyl	41464-49-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1017	2,2',3',4,5-Pentachlorobiphenyl	41464-51-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1018	Lead fluoride (PbF3)	41547-50-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1019	Lead bis(piperidine-1-carbodithioate)	41596-46-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1020	Lead propionate	42558-73-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1021	Sulfuric acid, barium lead salt	42579-89-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1022	2,2',3,3',4,4',5,6'-octachlorobiphenyl	42740-50-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1023	Octanoic acid, pentadecafluoro-, ion (1-)	45285-51-6	Intentional addition / 100ppm	articles/ chemical products
1024	Stannane, [(1-oxododecyl)oxy]triphenyl-	47872-31-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1025	Hexahydro-1-methylphthalic anhydride	48122-14-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1026	Mercury(II) trifluoromethanesulfonate	48540-00-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1027	1,1'-Biphenyl, 2,3'-dibromo-	48602-90-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1028	1,1'-Biphenyl, 2,4'-dibromo-	48602-91-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1029	Zinc chromate hydroxide (Zn3(CrO4)(OH)8)	48663-84-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1030	Phenol, 2-methyl-4-nitro-, lead salt	50319-14-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1031	Tridecafluoro acid, lead(2+) salt	50354-80-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1032	1,2,4-Trichloronaphthalene	50402-51-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1033	1,2,3-Trichloronaphthalene	50402-52-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1034	Perchlorophenyl 5-oxo-D-prolinate	50654-95-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1035	Bicyclo[2,2,2]oct-5-ene-2,3-dicarboxylic acid, 1-methyl-4-(1-methylethyl)-, lead(2+) salt (2:1), compound with lead oxide (PbO)	50729-74-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1036	Cyclohexanecarboxylic acid, lead salt (1:?)	50825-29-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1037	Tribromobiphenyl	51202-79-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1038	Mercury chloride	51312-24-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1039	Lead nitrosorcinat	51317-24-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1040	Trinitrophenylglucinol, lead salt	51325-28-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1041	1,3-Benzenediol, 2,4,6-trinitro-, lead(2+) salt, monobasic	51331-05-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1042	Acetic acid, lead salt, basic	51404-69-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1043	1,3,5-Trichloronaphthalene	51570-43-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1044	1,2,6-Trichloronaphthalene	51570-44-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1045	1,2,4,6-Tetrachloronaphthalene	51570-45-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1046	Mercury sulfide (Hg2S)	51595-71-2	Intentional addition / 1,000ppm	articles/ chemical products
1047	Diheptylmercury	51622-02-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1048	Lead chromate sulfate (Pb9(CrO4)5(SO4)4)	51899-02-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1049	2,2',3,4,5,5'-hexachlorobiphenyl	51908-16-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1050	Octadecanoic acid, lead(2+) salt, tribasic	52080-60-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1051	Sulfurous acid, lead salt, basic	52231-92-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1052	Benzoic acid, 2-methyl-, lead(2+) salt	52337-73-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1053	4-(1-Ethyl-1-methylhexyl)phenol	52427-13-1	Intentional addition / 1,000ppm	articles/ chemical products
1054	Lead methacrylate	52609-46-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1055	Lead stearate dibasic	52652-59-2	Intentional addition / 1,000ppm	articles/ chemical products
1056	2,3,4,6-tetrachlorobiphenyl	52663-58-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1057	2,2',3,4-tetrachlorobiphenyl	52663-59-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1058	2,2',3,3',6-pentachlorobiphenyl	52663-60-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1059	2,2',3,5,5'-pentachlorobiphenyl	52663-61-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1060	2,2',3,3',4-pentachlorobiphenyl	52663-62-4	Contains (regardless of intentional or impurities)	articles/ chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
1061	2,2',3,5,5',6'-hexachlorobiphenyl	52663-63-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1062	2,2',3,3',5,5',6'-heptachlorobiphenyl	52663-64-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1063	2,2',3,3',4,6,6'-heptachlorobiphenyl	52663-65-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1064	2,2',3,3',4,5'-hexachlorobiphenyl	52663-66-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1065	2,2',3,3',5,5',6'-heptachlorobiphenyl	52663-67-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1066	2,2',3,4,4',5'-hexachlorobiphenyl	52663-68-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1067	2,2',3,4,4',5,6'-heptachlorobiphenyl	52663-69-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1068	2,2',3,3',4,5,6'-heptachlorobiphenyl	52663-70-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1069	2,2',3,3',4,4',6'-heptachlorobiphenyl	52663-71-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1070	2,4,5,3',4',5'-hexachlorobiphenyl	52663-72-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1071	2,2',3,3',4,5,6,6'-octachlorobiphenyl	52663-73-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1072	2,2',3,3',4,4',5,6'-heptachlorobiphenyl	52663-74-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1073	2,2',3,3',4,5,5',6'-octachlorobiphenyl	52663-75-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1074	2,2',3,3',4,4',5,5',6'-octachlorobiphenyl	52663-76-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1075	2,2',3,3',4,4',5,5',6,6'-nonachlorobiphenyl	52663-77-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1076	2,2',3,3',4,4',5,6'-octachlorobiphenyl	52663-78-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1077	2,2',3,3',4,4',5,6,6'-nonachlorobiphenyl	52663-79-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1078	2,2',3,3',5,6'-hexachlorobiphenyl	52704-70-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1079	2,2',3,4,5,5'-hexachlorobiphenyl	52712-04-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1080	2,2',3,4,5,5',6'-heptachlorobiphenyl	52712-05-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1081	Sulfuric acid, lead salt, tetrabasic	52732-72-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1082	2,2',3,3',5,6'-hexachlorobiphenyl	52744-13-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1083	(2-carboxy-m-tyl)hydroxymercury, monosodium salt	52795-88-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1084	Lead bis(isononanoate)	52847-85-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1085	Mercury(2+), bis(2,4,6-tri-2-pyridinyl-1,3,5-triazine-N1,N2,N6)-, (OC-6-1'2)-	53010-52-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1086	Carbonic acid, calcium lead palladium salt	53092-86-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1087	Lead fluoride	53096-04-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1088	Arsenic acid, lead (4+) salt	53404-12-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1089	Mercury thiocyanate	53408-91-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1090	Silicic acid, lead salt, basic	53466-66-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1091	Aroclor 1242	53469-21-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1092	Lead, [3-mercapto-D-valinato(2-)-N,O,S]-	53513-80-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1093	Chromium lead oxide sulfate	53529-09-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1094	1,2,3,5-Tetrachloronaphthalene	53555-63-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1095	1,3,5,7-Tetrachloronaphthalene	53555-64-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1096	1,2,3,5,7-Pentachloronaphthalene	53555-65-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1097	3,4,5-trichlorobiphenyl	53555-66-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1098	1,1'-Biphenyl, 2,4-dibromo-	53592-10-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1099	Mercury, [3-nitrobenzoato(2-)-C2,O1]-	53663-14-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1100	Nonachloro-1,1'-biphenyl	53742-07-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1101	Phosphonic acid, lead salt, basic	53807-64-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1102	Mercury, [N-(2-methylphenyl)benzenesulfonamido-N]phenyl-	54129-03-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1103	2,3,4,6-tetrachlorobiphenyl	54230-22-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1104	Tetrakis(acetato-O)[mu,4-(3',6'-dihydroxy-3-oxospiro[isobenzofuran-1(3H),9'-[9H]xanthen)-2',4',5',7'-tetrayl]tetramercury	54295-90-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1105	1,3,5-Triazine-2,4,6-(1H,3H,5H)-trione, lead salt	54554-36-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1106	2,2',3,3',5,5'-Hexabromobiphenyl	55066-76-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1107	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, lithium salt	55120-77-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1108	(±)-2,2',3,4,4',6'-Pentachlorobiphenyl	55215-17-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1109	2,2',3,3',4,5'-hexachlorobiphenyl	55215-18-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1110	2,2',3,4,5'-pentachlorobiphenyl	55312-69-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1111	Pentachlorophenyl N-[(benzoyloxy)carbonyl]-L-tyrosinate	55593-07-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1112	2,3,6-trichlorobiphenyl	55702-45-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1113	PCB 21	55702-46-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1114	2,2',4,4'-trichlorobiphenyl	55712-37-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1115	1,2,5-Trichloronaphthalene	55720-33-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1116	1,2,7-Trichloronaphthalene	55720-34-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1117	1,2,8-Trichloronaphthalene	55720-35-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1118	1,3,6-Trichloronaphthalene	55720-36-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1119	1,3,7-Trichloronaphthalene	55720-37-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1120	1,3,8-Trichloronaphthalene	55720-38-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1121	1,6,7-Trichloronaphthalene	55720-39-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1122	2,3,6-Trichloronaphthalene	55720-40-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1123	1,2,3,7-Tetrachloronaphthalene	55720-41-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1124	1,3,6,7-Tetrachloronaphthalene	55720-42-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1125	1,4,6,7-Tetrachloronaphthalene	55720-43-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1126	2,3,5-trichlorobiphenyl	55720-44-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1127	octachlorobiphenyl	55722-26-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1128	(2',7'-Dibromo-3',6'-dihydroxy-3-oxospiro[isobenzofuran-1(3H),9'-[9H]xanthen]-4'-yl)hydroxymercury	55728-51-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1129	Phenol, pentachloro-, calcium salt	55868-72-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1130	Mercury, (o-carboxyphenyl)hydroxy-, sodium salt	55939-60-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1131	(±)-2,2',3,4,4',6'-Hexachlorobiphenyl	56030-56-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1132	Dibasic lead stearate	56189-09-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1133	Pentabromobiphenyl	56307-79-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1134	6,11-Dioxo-5,12-distannahexadecane, 8,9-dibromo-5,5,12,12-tetrabutyl-7,10-dioxo-	56323-17-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1135	1,6-Methano-1H-indene, 2,3,3a,4,5,7-hexachloro-3a,6,7,7a-tetrahydro-, (1R,3aR,6S,7S,7aR)-rel-	56534-03-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1136	2,2',4,6,6'-pentachlorobiphenyl	56558-16-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1137	2,3',4,4',6'-pentachlorobiphenyl	56558-17-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1138	2,3',4,5',6'-pentachlorobiphenyl	56558-18-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1139	Lead niobium titanium zirconium oxide	56572-83-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1140	gamma-Chlordene	56641-38-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1141	Mercury, phenyl(phenyldiazene)carbothioic acid 2-phenylhydrazidato-	56724-82-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1142	Ethanaminium, N,N,N-triethyl-, salt with 1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8-heptadecafluoro-1-octanesulfonic acid (1:1)	56773-42-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1143	1,3-Isobenzofurandione, hexahydro-4-methyl-	57110-29-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1144	Lead, [1,2-benzenedicarboxylato(2-)]oxodi-	57142-78-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1145	1,1'-Biphenyl, 3,4'-dibromo-	57186-90-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1146	Lead hydroquinonate	57218-73-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1147	Mercury, compound with sodium (4:1)	57363-77-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1148	1,1'-Biphenyl, 2,5-dibromo-	57422-77-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1149	Phenol, tetrapropylene-	57427-55-1	1,000ppm	articles/ chemical products
1150	3,3',4,4',5'-pentachlorobiphenyl	57465-28-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1151	Benzoic acid, 4-methyl-, lead(2+) salt	58274-53-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1152	Lead bis(12-hydroxystearate)	58405-97-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1153	1,2,3,4,5,6,7-Heptachloronaphthalene	58863-14-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1154	1,2,3,4,5,6,8-Heptachloronaphthalene	58863-15-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1155	1,2,3,4,5,6'-Hexachloronaphthalene	58877-88-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1156	1,1'-Biphenyl, 2,6-dibromo-	59080-32-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1157	1,1'-Biphenyl, 2,4,6-tribromo-	59080-33-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1158	1,1'-Biphenyl, 2,2',5-tribromo-	59080-34-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1159	1,1'-Biphenyl, 2,3',5-tribromo-	59080-35-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1160	1,1'-Biphenyl, 2,4',5-tribromo-	59080-36-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1161	1,1'-Biphenyl, 2,2',5,5'-tetrabromo-	59080-37-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1162	1,1'-Biphenyl, 2,3',4',5'-tetrabromo-	59080-38-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1163	1,1'-Biphenyl, 2,2',4,5'-pentabromo-	59080-39-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1164	2,2',4,4',5,5'-Hexabromo-1,1'-biphenyl	59080-40-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1165	2,2',4,4',6,6'-Hexabromobiphenyl	59261-08-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1166	2,2',3,4,4',6'-hexachlorobiphenyl	59291-64-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1167	2,2',3,4,4',5',6'-hexachlorobiphenyl	59291-65-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1168	Firemaster BP-6	59536-65-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1169	1,1'-Biphenyl, 3,4,4',5'-tetrabromo-	59589-92-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1170	1,3,5-Tris[(2S and 2R)-2-(3-epoxypropyl)-1,3,5-triazine-2,4,6-(1H,3H,5H)-trione	59653-74-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1171	Lead ruthenium oxide	59707-49-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1172	1,1'-Biphenyl, 2,2',4,5'-tetrabromo-	60044-24-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1173	1,1'-Biphenyl, 2,2',5,6'-tetrabromo-	60044-25-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1174	3,3',4,4',5,5'-Hexabromobiphenyl	60044-26-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1175	1,1'-Biphenyl, 3,4-dibromo-	60108-72-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1176	2,2',3,3',5'-pentachlorobiphenyl	60145-20-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1177	2,2',4,5,6'-pentachlorobiphenyl	60145-21-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1178	2,2',4,4',5,6'-hexachlorobiphenyl	60145-22-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1179	2,2',3,4,4',5,6'-heptachlorobiphenyl	60145-23-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1180	2,3',4,6'-tetrachlorobiphenyl	60233-24-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1181	2,2',3,4',6'-pentachlorobiphenyl	60233-25-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1182	Dilead ethylenediaminetetracetic acid	60251-56-1	Intentional addition / 1,000ppm	articles/ chemical products
1183	1H-Tetrazole, 5-nitro-, mercury(2+) salt	60345-95-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1184	2,2',4,4',5'-Pentabromodiphenyl ether	60348-60-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1185	Lead 5-nitroterephthalate	60580-60-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1186	Lead strontium titanium zirconium oxide	61461-40-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1187	Hydrogenated terphenyls	61788-32-7	Intentional addition / 1,000ppm	articles/ chemical products
1188	Naphthenic acids, lead manganese salts	61788-52-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1189	Fatty acids, tall-oil, lead manganese salts	61788-53-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1190	Fatty acids, tall-oil, lead salts	61788-54-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1191	Chloroalkanes	61788-76-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1192	Naphthenic acid, cobalt lead manganese salt	61789-50-2	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
1193	Lead naphthenate	61790-14-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1194	[2-(2-hydroxyethyl)amino]phenylmercury acetate	61792-06-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1195	2,2',3,3',4,6-hexachlorobiphenyl	61798-70-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1196	Naphthalenesulfonic acid, dinonyl-, lead(2+) salt	61867-68-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1197	Magnesium(2+), hexaqua-, (OC-6-11)-, (OC-6-21)-[[N,N'-1,2-ethanediy]bis[N-(carboxymethyl)glycinate]](4-)-N,N',O',O'',ON''-plumbate(2-)(1:1)	61993-29-1	Intentional addition	articles/ chemical products
1198	2,3,3,3-Tetrafluoro-2-(heptafluoropropoxy)propanoic acid ammonium salt	62037-90-3	Intentional addition / 1,000ppm	articles/ chemical products
1199	Lead diselenite	62042-25-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1200	Sulfurous acid, lead salt, dibasic	62229-08-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1201	Mercury, bis(3-hydroxy-1-propenyl)-	62374-53-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1202	Bis(acetoxybenzoato)lead	62451-77-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1203	2,4,4'(or 3,4,4')-trichlorobiphenyl	62461-62-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1204	Cyclohexanecarboxylic acid, lead(2+) salt	62637-99-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1205	Cyclohexanecarboxylic acid, mercury(2+) salt	62638-02-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1206	2,2',4,6-tetrachlorobiphenyl	62796-85-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1207	Mercurate(2-), tetraiodo-, (T-4)-, dihydrogen, compound with 5-iodo-2-pyridinamine (1:2)	63245-16-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1208	Lead(2+) heptadecanoate	63399-94-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1209	Undecanoic acid, lead(2+) salt	63400-07-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1210	Nonanoic acid, lead(2+) salt	63400-08-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1211	Chlorinated paraffin waxes and hydrocarbon waxes	63449-39-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1212	Mercury, (acetato-O)(2-hydroxy-5-nitrophenyl)-	63468-53-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1213	Mercury, bis(acetato-O)(benzenamine)-	63549-47-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1214	Naphthalenesulfonic acid, disononyl-, lead(2+) salt	63568-30-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1215	Basic lead sulfate	63653-42-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1216	Mercury, (acetato-O)(diethyl phosphito-P)-	63668-93-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1217	Mercury, (acetato-O)(nitrophenyl)-	63668-95-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1218	Mercury, (3-(alpha-carboxy-m-aminido)-2-hydroxypropyl)hydroxy-	63668-96-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1219	Mercury, (3-(alpha-carboxy-p-aminido)-2-hydroxypropyl)hydroxy-	63668-98-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1220	Mercury, chloro(dibutyl phosphito-P)-	63669-01-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1221	Mercury, [bis(1-methylethyl) phosphito-P]chloro-	63669-02-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1222	Mercury, (3-cyanoguanidino)ethyl-	63669-03-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1223	Mercury, (2-hydroxyphenyl)hydroxy-	63669-04-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1224	Mercury, methyl-, N-bis(g-tolylsulfonyl)amido-	63669-05-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1225	Mercury, methyl(toluenesulfonato)-	63669-06-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1226	Mercury, methyl(5-isopropyl-N-(p-tolyl)-o-toluenesulfonamido)-	63669-07-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1227	Mercury, thiododecamethylenebis(phenyl)-	63669-08-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1228	Acetic acid, fluoro-, mercury(2+) salt	63905-89-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1229	Lead(II) perchlorate, hexahydrate	63916-96-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1230	Lead styphnate	63918-97-8	Intentional addition / 1,000ppm	articles/ chemical products
1231	Mercury gluconate	63937-14-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1232	Mercury, bis(acetato-O)[m-(2-amino-5-nitro-1,3-phenylene)]di-	63951-06-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1233	Mercury, [mu-(2-amino-5-nitro-1,3-phenylene)]dihydroxydi-	63951-09-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1234	Undecane, 1,1,1,2-tetrachloro-	63981-28-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1235	Mercury, mu-,1,2-ethylenediylbis(2-methoxyethyl)di-	63990-59-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1236	Mercury, (2,4-pentanedionato-O,O')phenyl-	64025-06-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1237	Mercury, (thiophene-2,5-diyl)bis(hydroxy-, monoacetate	64048-08-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1238	Mercury, (2-amino-5-nitrophenyl)hydroxy-	64049-27-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1239	Mercury, bis(acetato-O)bis[m-(2-amino-5-nitro-1,3-phenylene)]tri-	64049-28-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1240	Mercury, acetoxy(2-acetamido-5-nitrophenyl)-	64058-72-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1241	Mercury, bis(acetato-O)omega-2-(acetilamino)-5-nitro-1,3-phenylene]di-	64058-74-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1242	1,1'-Biphenyl, 2,4,4',6-tetrabromo-	64238-02-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1243	1,1'-Biphenyl, 2,4,6-tribromo-	64238-03-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1244	Isosaccharic acid, lead salt	64504-12-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1245	Mercury, phenyl(1-thio-beta-D-glucopyranose 2,3,4,6-tetraacetato-S)-	64697-74-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1246	Mercury, (dimethylcarbamothioato-S)phenyl-	64697-75-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1247	Mercury, [4-(diethylamino)phenyl](1-thio-beta-D-glucopyranose 2,3,4,6-tetraacetato-S)-	64697-76-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1248	Mercury, bis(1-thio-beta-D-glucopyranose 2,3,4,6-tetraacetato-S)-	64697-77-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1249	Mercury, bis(1-thio-beta-D-glucopyranosato-S)-	64697-78-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1250	Mercury, phenyl(1-thio-beta-D-glucopyranosato-S)-	64714-49-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1251	Bis(2-chloroethyl)mercury	64771-59-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1252	Lead dibutanoate	65119-94-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1253	Lead(2+) 4,6-dinitro-o-cresolate	65121-76-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1254	Diethyl(dibutyl)lead	65121-94-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1255	Lead 12-hydroxyoctadecanoate	65127-78-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1256	Bismuth lead ruthenium oxide	65229-22-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1257	2,3,4,4',5-Pentachlorobiphenyl	65510-44-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1258	2,2',3,4,4'-pentachlorobiphenyl	65510-45-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1259	Cyclododecane, 1,2,5,6,9,10-hexabromo-, (1R*,2S*,5R*,6S*,9S*,10R*)-	65701-47-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1260	Pitch, coal tar, high-temperature	65996-93-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1261	1,1'-Biphenyl, 2,2',4,4'-tetrabromo-	66115-57-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1262	Mercury(2+), (4-nitrophenyl)azanide	66827-74-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1263	Potassium 2,3,3,3-tetrafluoro-2-(heptafluoropropoxy)propionate	67118-55-2	Intentional addition / 1,000ppm	articles/ chemical products
1264	Perchlorophenyl 5-oxo-DL-prolinate	67246-71-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1265	Mercury, chloro(3-(2,4-dioxo-3-methyl-1-imidazolidinyl)-2-methoxy)propyl-	67465-39-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1266	Mercury, 2,5-furylidenebis(chloro)-	67465-41-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1267	Mercury, hydroxy(3-(5,5-diethyl-2,4,6-trioxo-(1H,3H,5H)-pyrimidino)-2-ethoxypropyl)-	67465-42-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1268	Mercury, hydroxy(3-(5,5-diethyl-2,4,6-trioxo-(1H,3H,5H)-pyrimidino)-2-isopropoxypropyl)-	67465-43-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1269	Mercury, hydroxy(3-(5,5-diethyl-2,4,6-trioxo-(1H,3H,5H)-pyrimidino)-2-methoxypropyl)-	67465-44-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1270	Mercury, (3-(alpha-carboxy-o-aminido)-2-(2-hydroxyethoxy)propyl)hydroxy-, monosodium salt	67466-58-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1271	Petrolatum, petroleum, oxidized, lead salt	67674-14-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1272	Lead silicate sulfate	67711-86-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1273	Octyl acrylate-methyl methacrylate-tributyltin methacrylate copolymer	67772-01-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1274	Firemaster FF-1	67774-32-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1275	1,1'-Biphenyl, 2,2',4,5,5'-pentabromo-	67888-96-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1276	2,2',3,4,4',5'-Hexabromobiphenyl	67888-98-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1277	2,2',3,4,4',5,5'-Hexabromobiphenyl	67888-99-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1278	1,2,4,7-Tetrachloronaphthalene	67922-21-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1279	1,2,5,6-Tetrachloronaphthalene	67922-22-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1280	1,2,5,7-Tetrachloronaphthalene	67922-23-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1281	1,2,6,8-Tetrachloronaphthalene	67922-24-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1282	1,2,3,4,5-Pentachloronaphthalene	67922-25-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1283	1,2,3,4,6-Pentachloronaphthalene	67922-26-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1284	1,2,3,4,5,7-Hexachloronaphthalene	67922-27-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1285	Silicic acid, lead nickel salt	68130-19-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1286	Fatty acids, C12-18, lead salts	68131-60-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1287	Resin acids and Rosin acids, calcium salts, polymers with lead resinates and saponified linseed oil	68139-27-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1288	Octanoic acid, pentadecafluoro-, chromium(3+) salt	68141-02-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1289	Linseed oil, reaction products with lead oxide (Pb3O4) and mastic	68152-99-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1290	2-Propenoic acid, 2-methyl-, methyl ester, polymer with ethenylbenzene, lead(2+) bis(2-methyl-2-propenoate) and alpha-(2-methyl-1-oxo-2-propenyl)-omega-[[2-methyl-1-oxo-2-propenyl]oxy]poly(oxy-1,2-ethanediy)	68155-47-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1291	Lead, 2-ethylhexanoate tall-oil fatty acids complexes	68187-37-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1292	2,2',4,6-tetrachlorobiphenyl	68194-04-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1293	2,2',3,4,6-pentachlorobiphenyl	68194-05-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1294	2,2',4,5,6-pentachlorobiphenyl	68194-06-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1295	2,2',3,4,5-pentachlorobiphenyl	68194-07-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1296	2,2',3,4,6'-hexachlorobiphenyl	68194-08-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1297	2,2',3,5,6'-hexachlorobiphenyl	68194-09-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1298	2,3,3',5'-pentachlorobiphenyl	68194-10-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1299	2,3,4',5'-pentachlorobiphenyl	68194-11-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1300	2,3,4,5,5'-pentachlorobiphenyl	68194-12-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1301	2,2',3,4,5,6-hexachlorobiphenyl	68194-13-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1302	2,2',3,4,5,6-hexachlorobiphenyl	68194-14-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1303	2,2',3,4,5,6'-hexachlorobiphenyl	68194-15-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1304	2,2',3,3',4,5,6-heptachlorobiphenyl	68194-16-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1305	2,2',3,3',4,5,5',6-octachlorobiphenyl	68194-17-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1306	Mercury, (acetato-O)diamminophenyl-, (T-4)-	68201-97-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1307	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, ammonium salt	68259-08-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1308	Cadmium zinc sulfide ((Cd,Zn)S), copper and lead-doped	68332-81-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1309	Fatty acids, C7-13, perfluoro	68333-92-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1310	Fatty acids, C8-10-branched, lead salts, basic	68409-79-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1311	Copper, beta-resorcyolate salicylate lead complexes	68411-07-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1312	1,3-Benzenediol, 2-nitro-, lead salt, basic	68411-33-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1313	Lead oxide (PbO), lead-containing	68411-78-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1314	Polyethylene glycol branched nonylphenyl ether	68412-54-4	Intentional addition / 100ppm	articles/ chemical products
1315	Fats and Glyceric oils, menhaden, lead salts	68424-76-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1316	Hexanoic acid, dimethyl-, lead(2+) salt, basic	68442-95-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1317	1,2-Benzenedicarboxylic acid, di-C7-11-branched and linear alkyl esters	68515-42-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1318	Dihexyl phthalate (mixed isomers)	68515-50-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1319	1,2-Benzenedicarboxylic acid, di-C6-10-alkyl esters	68515-51-5	Intentional addition / 1,000ppm	articles/ chemical products
1320	Hexanoic acid, 2-ethyl-, lead(2+) salt, basic	68515-76-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1321	Hexanoic acid, 3,5-trimethyl-, lead(2+) salt, basic	68515-77-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1322	Lead, isocyanate naphthenate complexes	68515-80-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1323	Linseed oil, lead manganese salt	68553-17-3	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
1324	Fats and Glyceric oils, fish, lead salts	68553-63-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1325	Spinels, boron calcium lead silicon white	68555-05-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1326	Spinels, lead silicon tin zinc white	68555-07-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1327	Zinc sulfide (ZnS), copper and lead-doped	68585-90-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1328	Phenol, dodecyl-, lead(2+) salt	68586-21-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1329	Fatty acids, C6-19-branched, lead salts, basic	68603-83-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1330	Carboxylic acids, tall-oil, lead salts, basic	68603-83-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1331	Castor oil, dehydrated, polymer with rosin, calcium lead zinc salt	68604-05-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1332	Octanoic acid, branched, lead salts, basic	68604-56-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1333	Fatty acids, tallow, hydrogenated, lead salts	68605-98-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1334	2,2',4,4',5,5'-Hexabromodiphenyl ether	68631-49-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1335	1,2-Benzenedicarboxylic acid, mixed decyl and hexyl and octyl diesters	68648-93-1	Intentional addition / 100ppm	articles/ chemical products
1336	Tungstate (WO4 <sup>2-</sup> ), calcium (1:1), (T-4)-, lead-doped	68784-53-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1337	Calcium acetate coco fatty acids decanoate hydrogenated tallow fatty acids octanoate lead complexes	68784-59-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1338	Silicic acid (H6Si2O7), barium magnesium strontium salt, lead-doped	68784-74-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1339	Silicic acid (H2SiO5), barium salt (1:1), lead-doped	68784-75-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1340	Silicic acid (H4SiO4), magnesium manganese(2+) zinc salt, arsenic and lead-doped	68784-76-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1341	Mercury acetylde	68833-55-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1342	Cadmium sulfide (CdS), copper and lead-doped	68891-87-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1343	2,4-Cyclohexadien-1-one, 3,5,6-trihydroxy-4,6-bis(3-methyl-2-butenyl)-2-(3-methyl-2-oxobutyl)-, lead salt, (R)-	68901-11-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1344	alpha-D-Glucopyranose, 1-(dihydrogen phosphate), lead salt	68901-12-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1345	Alkanes, C6-18, chloro-	68920-70-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1346	Benzene, 1,1'-oxybis-, heptabromo derivative	68928-80-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1347	Acetic acid, reaction products with lead oxide (PbO), silica and sulfuric acid	68937-05-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1348	Hydrocarbon waxes, petroleum, microcrystalline, chlorinated	68938-43-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1349	Resin acids and Rosin acids, calcium lead salts	68952-91-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1350	1,4-Benzenediamine, N,N'-mixed phenyl and tolyl derivatives	68953-84-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1351	Benzoic acid, 2,4-dihydroxy-, lead salt, basic	68954-05-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1352	Gilsonite, polymer with cyclopentadiene, dicyclopentadiene and linseed oil, lead salts	68956-49-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1353	Barium bismuth lead niobium titanium oxide	68987-33-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1354	Gilsonite, polymer with linseed oil, lead salt	68989-89-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1355	Linseed oil, polymer with tung oil, lead salt	68990-75-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1356	Lead, [1,2-benzenedicarboxylato(2-)]dioxotri-	69011-06-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1357	Lead chromate silicate (Pb3(CrO4)(SiO4))	69011-07-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1358	Lead alloy, dross	69011-59-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1359	Lead alloy, Pb, Sn, dross	69011-60-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1360	Flue dust, lead-tin alloy-manufacturing - Volatilized metals generated during smelting and refining of tin-lead alloys. Consists primarily of oxides of lead and tin.	69012-60-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1361	Lead, dross, antimony-rich	69029-45-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1362	Lead, dross, bismuth-rich	69029-46-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1363	Lead, antimonial	69029-50-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1364	Lead, antimonial, dross	69029-51-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1365	Lead, dross	69029-52-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1366	Lead oxide (PbO), retort	69029-53-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1367	Slags, lead reveratory smelting	69029-58-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1368	Bismuth, refinery lead chloride residues	69029-61-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1369	Flue dust, lead-refining	69029-67-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1370	Leach residues, lead slag	69029-71-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1371	Leach residues, precious metal recovery lead refining	69029-72-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1372	Calclines, lead ore concentrated	69029-74-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1373	Residues, lead roaster	69029-78-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1374	Residues, lead smelting	69029-79-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1375	Residues, precious metal recovery lead refining	69029-80-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1376	Slags, lead smelting	69029-84-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1377	Slags, precious metal recovery lead refining	69029-85-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1378	Slimes and Sludges, lead refining	69029-93-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1379	Lead, bis[bis(2-methylpropyl)carbamodithioato-S,S']-, (T-4)-	69090-73-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1380	Calcium acetate candleilla wax oleate tallow lead complexes	69103-03-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1381	Fatty acids, tallow, hydrogenated, mixed with acetic acid, coconut oil, decanoic acid and octanoic acid, calcium lead salts	69103-04-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1382	Lead, dross, copper-rich	69227-11-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1383	2,2',3,4',5',6'-Hexabromobiphenyl	69278-59-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1384	Lead(II) elaidiate	69637-83-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1385	2,3',4,4',5'-hexachlorobiphenyl	69782-90-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1386	2,3',4',5',5',6'-heptachlorobiphenyl	69782-91-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1387	Lead, C6-19-branched carboxylate naphthenate complexes	70084-67-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1388	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, zinc salt	70136-72-0	Intentional addition / 1,000ppm	articles/ chemical products
1389	1-Octanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-heptadecafluoro-, compound with 2,2'-iminobis[ethanol] (1:1)	70225-14-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1390	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, compound with 2,2'-iminobis[ethanol] (1:1)	70225-16-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1391	1,3-Benzenediol, nitro-, lead(2+) salt (1:1)	70268-38-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1392	1,4-Benzenediamine, N-(dimethylphenyl)-N'-(methylphenyl)-	70290-05-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1393	Lead, decanoate octanoate complexes	70321-55-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1394	2,3',4',5'-pentachlorobiphenyl	70362-41-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1395	2,2',3,6-tetrachlorobiphenyl	70362-45-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1396	2,2',3,5-tetrachlorobiphenyl	70362-46-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1397	2,2',4,5-tetrachlorobiphenyl	70362-47-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1398	2,3',4',5'-tetrachlorobiphenyl	70362-48-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1399	3,3',4,5-tetrachlorobiphenyl	70362-49-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1400	3,4',4',5-tetrachlorobiphenyl	70362-50-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1401	2,3,3',5-tetrachlorobiphenyl	70424-67-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1402	2,3,3',4',5-pentachlorobiphenyl	70424-68-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1403	2,3,3',4,5-pentachlorobiphenyl	70424-69-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1404	2,3',4',5,5'-pentachlorobiphenyl	70424-70-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1405	Lead, alkyls, manufacturing wastes	70513-89-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1406	Flue dust, lead blast furnace	70514-05-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1407	Slimes and sludges, chlorine manufacture mercury cell brine treatment	70514-23-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1408	Slimes and Sludges, lead sinter dust scrubber	70514-37-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1409	Lead(2+) isooctadecanoate	70727-02-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1410	Naphthalene, chloro derivatives	70776-03-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1411	Fatty acids, C18-unsaturated, dimers, polymers with dehydrated castor-oil fatty acids and glycerol, lead salts	70879-91-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1412	Lead, bis(dipropylcarbamodithioato-S,S')-, (T-4)-	70995-63-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1413	Alkanes, C12-13, chloro	71011-12-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1414	1-Octanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-heptadecafluoro-, compound with piperidine (1:1)	71463-74-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1415	Lead(2+) neodecanoate	71684-29-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1416	Lead(II) fumarate	71688-03-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1417	Mercury(1+) ethyl sulphate	71720-55-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1418	Hydroxyneodecanoato-Olead	71753-04-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1419	Silicic acid (H6Si2O7), barium zinc salt (1:1:2), lead-doped	71799-66-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1420	Diisohexyl phthalate	71850-09-4	Intentional addition / 1,000ppm	articles/ chemical products
1421	1,2-Benzenedicarboxylic acid, di-C6-8-branched alkyl esters, C7-rich	71888-89-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1422	Phenol, 4-(1,3-dimethylpentyl)-	71945-81-8	Intentional addition	articles/ chemical products
1423	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, compound with N,N-diethylethanamine (1:1)	72033-41-1	Intentional addition / 1,000ppm	articles/ chemical products
1424	Mercury, methyl-, dimercaptopropional	72066-32-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1425	Ethanesulfonic acid, 2-hydroxy-, lead(2+) salt (2:1)	72437-77-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1426	Lead ionophore I	72469-41-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1427	Lead bis(nonylphenolate)	72586-00-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1428	Fatty acids, C6-18, perfluoro, ammonium salts	72623-77-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1429	Phenol, heptyl derivatives	72624-02-3	Intentional addition / 1,000ppm	articles/ chemical products
1430	Pentacosfluorotridecanoic acid	72629-94-8	Intentional addition / 1,000ppm	articles/ chemical products
1431	Phenol, 4(1,1,2,2-tetramethylpropyl)-	72861-06-4	Intentional addition	articles/ chemical products
1432	Carboxylic acids, C7-13, perfluoro, ammonium salts	72968-38-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1433	1,1'-Biphenyl, 2,2',3,4',5'-pentabromo-	73141-48-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1434	Mercury(II) perchlorate trihydrate	73491-34-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1435	2,3',4',5-tetrachlorobiphenyl	73575-52-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1436	2,3',4,5-tetrachlorobiphenyl	73575-53-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1437	2,2',3,6,6'-pentachlorobiphenyl	73575-54-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1438	2,2',3,5,6'-pentachlorobiphenyl	73575-55-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1439	2,2',3,5,6-pentachlorobiphenyl	73575-56-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1440	2,2',3,4,6'-pentachlorobiphenyl	73575-57-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1441	Mercury, chloro(2-(3-bromopropionamido)cyclohexyl)-, (E)-	73926-87-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1442	Mercury, chloro(2-hexanamidocyclohexyl)-, (E)-	73926-88-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1443	Mercury, chloro(2-(3-methoxypropionamido)cyclohexyl)-	73926-89-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1444	Mercury, dianilino-	73928-11-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1445	Mercury(II), ethyl(5-ethylmercuri-3-(1,2,4-thiadiazolyl)thio)-	73928-12-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1446	1,1'-Biphenyl, 2,3,4,4',5-pentabromo-	74114-77-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1447	2,3',5',6-tetrachlorobiphenyl	74338-23-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1448	2,3',4-tetrachlorobiphenyl	74338-24-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1449	Benzoic acid, 2-(acetyloxy)-, lead(2+) salt	74356-14-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1450	2,3,3',6-tetrachlorobiphenyl	74472-33-6	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
1451	2,3,4,5-tetrachlorobiphenyl	74472-34-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1452	2,3,3',4,6-pentachlorobiphenyl	74472-35-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1453	2,3,3',5,6-pentachlorobiphenyl	74472-36-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1454	2,3,4,4',5-pentachlorobiphenyl	74472-37-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1455	2,3,4,4',6-pentachlorobiphenyl	74472-38-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1456	2,3',4',5'-pentachlorobiphenyl	74472-39-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1457	2,2',3,4,6,6'-hexachlorobiphenyl	74472-40-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1458	2,2',3,4,5,6'-hexachlorobiphenyl	74472-41-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1459	2,3,3',4,4',6-hexachlorobiphenyl	74472-42-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1460	2,3,3',4,5,6-hexachlorobiphenyl	74472-43-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1461	2,3,3',4,5,6'-hexachlorobiphenyl	74472-44-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1462	2,3,3',4,5,6-hexachlorobiphenyl	74472-45-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1463	2,3,3',5,6-hexachlorobiphenyl	74472-46-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1464	2,2',3,4,4',5,6-heptachlorobiphenyl	74472-47-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1465	2,2',3,4,4',6,6'-heptachlorobiphenyl	74472-48-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1466	2,2',3,4,5,6,6'-heptachlorobiphenyl	74472-49-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1467	2,3,3',4,4',5,6-heptachlorobiphenyl	74472-50-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1468	2,3,3',4,5,5',6-heptachlorobiphenyl	74472-51-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1469	2,2',3,4,4',5,6,6'-octachlorobiphenyl	74472-52-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1470	2,2',3,3',4,4',5,5',6-octachlorobiphenyl	74472-53-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1471	2,2',3,4',5,6,6'-heptachlorobiphenyl	74487-85-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1472	Phenol, (tetrapropenyl) derivatives	74499-35-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1473	Butylphenyl methylpropiol, (+)	75166-30-2	1,000ppm	articles/ chemical products
1474	Butylphenyl methylpropiol, (-)	75166-31-3	1,000ppm	articles/ chemical products
1475	Mercury(II) trifluoroacetate	75513-04-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1476	Lead, bis(diphenylcarbamodithioato-S,S)-, (T-4)-	75790-73-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1477	22-Tricosenoic acid, lead(II) salt	76835-98-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1478	2,2',3,4',5'-pentachlorobiphenyl	76842-07-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1479	Benzoic acid, 2-methyl-, lead salt	76925-97-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1480	1,1'-Biphenyl, 3,3',4,4'-tetrabromo-	77102-82-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1481	2,3,3',4,4',5-Hexabromobiphenyl	77607-09-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1482	1,1'-Biphenyl, 2,2',3,4,6-pentabromo-	77910-04-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1483	Chloroacetylmercury	78571-20-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1484	Pigment Lightfast Lead-Molybdate Orange OS	78690-68-3	Intentional addition / 100ppm	articles/ chemical products
1485	Lead, (2-methyl-4,6-dinitrophenolato-O)(nitro-O)-mu-oxodi-, monohydrate	79357-62-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1486	Lead, C3-13-fatty acid naphthenate complexes	79803-79-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1487	1,1'-Biphenyl, 2,2',4,5,6-pentabromo-	80274-92-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1488	2,2',3,4,4',5-Hexabromobiphenyl	81381-52-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1489	1,1'-Biphenyl, 2,2',4,4',5-pentabromo-	81397-99-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1490	Fatty acids, C9-11-branched, lead salts	81412-57-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1491	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, sodium salt	82382-12-5	Intentional addition / 1,000ppm	articles/ chemical products
1492	Benzenesulfonic acid, hydroxy-, lead salt	82696-30-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1493	Lead hydroxide sulfate (Pb4(OH)6(SO4))	82800-11-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1494	2,2',3,3',4,4'-Hexabromobiphenyl	82865-89-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1495	2,2',3,3',4,5'-Hexabromobiphenyl	82865-90-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1496	2,3,3',4,4',5'-Hexabromobiphenyl	82865-91-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1497	Hexafluorosilicate(2-), lead(2+)(1:1), tetrahydrate	83689-82-1	Intentional addition / 1,000ppm	articles/ chemical products
1498	Lead, C5-23-branched carboxylate C4-10-fatty acid naphthenate complexes	83711-45-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1499	Lead, C5-23-branched carboxylate naphthenate complexes	83711-46-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1500	Lead, C5-23-branched carboxylate naphthenate octanoate complexes	83711-47-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1501	Plumbate(2-), [[N,N'-1,2-ethanedithylbis(N-(carboxymethyl)glycinate)]4]-N,N',O,O',ON,ON]-, dihydrate (2:3), (OC-6-21)-	83896-77-9	Intentional addition	articles/ chemical products
1502	Bis(acetato-O)[mu-1,3-dioxane-2,5-diybis(methylene)-c:c:O,O']dimercury	84029-43-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1503	Lead, C5-23-branched carboxylate C4-10-fatty acid complexes	84066-98-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1504	Lead, C5-23-branched carboxylate octanoate complexes	84066-99-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1505	Lead, C4-10-fatty acid naphthenate complexes	84067-00-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1506	Alkanes, C10-21, chloro	84082-38-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1507	Leach residues, nickel-vanadium ore - Residues from basic leaching of nickel-bearing vanadium ores. Composed primarily of silica and insoluble compounds of nickel and vanadium with minor quantities of other metals, such as arsenic, lead, tin and zinc.	84144-92-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1508	Matte, lead	84195-51-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1509	Slimes and Sludges, lead, electrolytic	84195-60-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1510	Speiss, lead	84195-61-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1511	1,1'-Biphenyl, 2,3',4,4'-tetrabromo-	84303-45-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1512	2,3,3',4,4',5'-Hexabromobiphenyl	84303-47-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1513	2,3,3',4,4',5,6'-Hexabromobiphenyl	84303-48-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1514	Lead bis(o-octylphenolate)	84394-98-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1515	Slimes and Sludges, zinc electrolytic	84583-61-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1516	Alkanes, C10-32, chloro	84776-06-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1517	Fatty acids, C8-18 and C18-unsaturated, lead salts	84776-36-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1518	Fatty acids, C8-12, lead salts	84776-53-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1519	Fatty acids, C18-24, lead salts	84776-54-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1520	1,2-Benzenedicarboxylic acid, dipentyl ester, branched and linear	84777-06-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1521	[mu-(4,6-Dinitrosorcinolato(2-)-O1,O3)]dihydroxylead	84837-22-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1522	Phenol, 4-nonyl-, branched	84852-15-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1523	Lead(II) isodecanoate	84852-34-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1524	Lead, isononanoate isooctanoate complexes, basic	84929-94-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1525	Lead, isooctanoate neodecanoate complexes, basic	84929-95-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1526	Lead, naphthenate neodecanoate complexes, basic	84929-96-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1527	Lead, isononanoate naphthenate complexes	84929-97-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1528	Benzenesulfonic acid, 4-C10-13-sec-alkyl derivatives, lead(2+) salts	84961-75-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1529	Bromotetradecylmercury	84973-20-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1530	Fatty acids, C8-10-branched, lead salts	85049-42-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1531	Flue dust, lead-manufacturing, cadmium-rich	85117-02-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1532	Lead(2+) 4-(1,1-dimethylethyl)benzoate	85292-77-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1533	Waste solids, copper electric cable cinders - Substance obtained from burning of insulated cable and wire. Contains mainly cuo and may contain carbonaceous residues and small amounts of lead and chlorine.	85305-08-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1534	Lead bis(5-oxo-L-prolinate)	85392-77-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1535	Lead bis(5-oxo-DL-prolinate)	85392-78-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1536	Stannane, tributyl-, mono(naphthenoxy) derivatives	85409-17-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1537	Paraffin oils, chloro	85422-92-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1538	Alkanes, C10-13, chloro	85535-84-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1539	Alkanes, C14-17, chloro	85535-85-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1540	Alkanes, C12-14, chloro	85536-22-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1541	Lead uranate pigment	85536-79-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1542	Alkanes, C10-14, chloro	85681-73-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1543	Lead 2-(2,4,5,7-tetrabromo-3-keto-6-oxo-3H-xanthen-9-yl)-2,3,4,5-tetrachlorobenzoate	85682-01-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1544	Lead iron sulfide	85764-81-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1545	Lead bis(tetracosylbenzenesulphonate)	85865-91-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1546	Lead bis(didodecylbenzenesulphonate)	85865-92-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1547	Pentanoic acid, 2-propyl-, lead(2+) salt	87835-32-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1548	Lead hydroxysalicylate	87903-39-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1549	1,1'-Biphenyl, 2,2',3,5,6-pentabromo-	88700-05-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1550	Polychlorinated biphenyls	89000-29-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1551	Brominated diphenyl ethers	90193-67-2	Intentional addition / 1,000ppm	articles/ chemical products
1552	1,2-Benzenedicarboxylic acid, lead(2+) salt, basic	90193-83-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1553	2-Butenedioic acid (E)-, lead(2+) salt, basic	90268-59-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1554	2-Butenedioic acid (Z)-, lead(2+) salt, basic	90268-66-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1555	Decanoic acid, branched, lead salts	90342-24-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1556	Dodecanoic acid, lead salt, basic	90342-56-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1557	Hexadecanoic acid, lead salt, basic	90388-09-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1558	Hexadecanoic acid, lead(2+) salt, basic	90388-10-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1559	9-Hexadecenoic acid, lead(2+) salt, (Z)-, basic	90388-15-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1560	Isodecanoic acid, lead salt, basic	90431-14-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1561	Isononanoic acid, lead salt, basic	90431-21-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1562	Isooctanoic acid, lead salt, basic	90431-26-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1563	Lead, C8-10-branched fatty acids C9-11-neofatty acids naphthenate complexes, overbased	90431-27-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1564	Lead, C8-10-branched fatty acids C9-11-neofatty acids naphthenate complexes	90431-28-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1565	Lead, 2-ethylhexanoate isodecanoate complexes, basic	90431-30-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1566	Lead, 2-ethylhexanoate isononanoate complexes, basic	90431-31-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1567	Lead, 2-ethylhexanoate isooctanoate complexes, basic	90431-32-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1568	Lead, 2-ethylhexanoate naphthenate complexes	90431-33-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1569	Lead, 2-ethylhexanoate naphthenate complexes, basic	90431-34-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1570	Lead, 2-ethylhexanoate neodecanoate complexes, basic	90431-35-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1571	Lead, isodecanoate isononanoate complexes, basic	90431-36-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1572	Lead, isodecanoate isooctanoate complexes, basic	90431-37-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1573	Lead, isodecanoate naphthenate complexes	90431-38-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1574	Lead, isodecanoate neodecanoate complexes, basic	90431-39-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1575	Lead, isononanoate naphthenate complexes, basic	90431-40-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1576	Lead, isononanoate neodecanoate complexes, basic	90431-41-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1577	Lead, isooctanoate naphthenate complexes, basic	90431-42-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1578	Lead, naphthenate neodecanoate complexes	90431-43-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1579	Lead, neononanoate neoundecanoate complexes, basic	90431-44-0	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
1580	Neodecanoic acid, lead salt, basic	90459-25-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1581	Neononanoic acid, lead salt, basic	90459-26-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1582	Neoundecanoic acid, lead salt, basic	90459-28-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1583	Octadecanoic acid, lead salt, basic	90459-51-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1584	Octadecanoic acid, lead(2+) salt, basic	90459-52-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1585	9-Octadecenoic acid (Z)-, lead salt, basic	90459-88-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1586	Octanoic acid, pentafluoro- branched, ammonium salt	90480-56-1	1,000ppm	articles/ chemical products
1587	2-Propenoic acid, 2-methyl-, lead salt, basic	90552-19-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1588	Anhydrous sodium perborate	90568-23-3	1,000ppm	articles/ chemical products
1589	Sulfurous acid, lead(2+) salt, basic	90583-07-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1590	Sulfurous acid, lead(2+) salt, basic	90583-07-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1591	Tetradecanoic acid, lead salt, basic	90583-85-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1592	Mercury, chloro[2-(2-cyclohexen-1-yl)-3-benzofuranyl]-	90584-88-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1593	Amines, coco alkyl, compounds with pentachlorophenol (1:1)	90640-52-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1594	Anthracene oil	90640-80-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1595	Anthracene oil, anthracene paste	90640-81-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1596	Anthracene oil, anthracene-low	90640-82-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1597	1,2,4,5,6,8-Hexachloronaphthalene	90948-28-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1598	Fatty acids, C8-19-branched, lead salts	91002-20-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1599	Fatty acids, C8-9, lead salts	91031-60-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1600	Fatty acids, C8-10, lead salts	91031-61-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1601	Fatty acids, C16-18, lead salts	91031-62-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1602	Magnesium bis[heptafluorooctanoatesulphonate]	91036-71-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1603	Leach residues, zinc ore, lead-containing	91053-49-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1604	Naphthenic acids, lead (2+) salts	91078-81-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1605	Quaternary ammonium compounds, coco alkyl(trimethyl), salts with pentachlorophenol	91080-93-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1606	Slimes and sludges, chlorine manufacture mercury cell process	91081-89-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1607	Lead(II) tetrakis(4-cumylphenoxy)phthalocyanine	91083-54-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1608	Benzoic acid, 2-butyl-, lead(2+) salt	91187-55-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1609	Lead boronic acid	91388-81-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1610	Stannane, diocetyl-, bis(coco acyloxy) derivatives	91648-39-4	1,000ppm	articles/ chemical products
1611	Isodecanoic acid, lead(2+) salt, basic	91671-82-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1612	Isocanoic acid, lead(2+) salt, basic	91671-83-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1613	Isoundecanoic acid, lead(2+) salt, basic	91671-84-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1614	Fatty acids, castor-oil, hydrogenated, lead salts	91697-36-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1615	Slimes and sludges, chlorine manufacture mercury cell brine treatment wastewater	91722-12-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1616	Phosphorodithioic acid, mixed O,O-bis(butyl and pentyl) esters, lead(2+) salt	91783-10-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1617	Anthracene oil, anthracene paste, anthracene fraction	91995-15-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1618	Anthracene oil, anthracene paste, distillation lights	91995-17-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1619	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, cesium salt (1:1)	92011-17-1	1,000ppm	articles/ chemical products
1620	Fatty acids, coco, lead salts	92044-89-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1621	Naphthenic acids, lead salts, basic	92045-67-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1622	Lead, C4-10-fatty acid octanoate complexes	92200-92-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1623	Mercury, reaction products with stibite (Sb2S3)	92200-97-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1624	Fatty acids, C14-26, lead salts	93165-26-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1625	2,2',3,4',6'-Hexabromobiphenyl	93261-83-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1626	Benzene, 1,1'-oxybis[3,4-dibromo-	93703-48-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1627	Slags, lead-zinc smelting	93763-87-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1628	Diiodo(5-iodopyridin-2-amine-N1)mercury	93820-20-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1629	Flue gases, lead-zinc blast furnace	93821-47-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1630	Slimes and Sludges, lead-zinc blast furnace, offgas wet cleaning	93821-70-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1631	Speiss, lead-zinc	93821-72-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1632	Lead 3-(acetamido)phthalate	93839-89-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1633	Lead bis(2-ethylhexanoate)	93840-04-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1634	Lead(2+) 4,4'-isopropylidenebisphenolate	93858-23-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1635	Lead(2+) (Z)-hexadec-9-enoate	93858-29-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1636	[mu-[[4-(Oxydiethylene bis(dodeceny)succinato)](2)-]]diphenylmercury	93882-20-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1637	Carbamodithioic acid, ethylphenyl-, lead(2+) salt	93892-85-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1638	Lead(2+) neononanoate	93894-48-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1639	Lead(2+) neoundecanoate	93894-49-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1640	(neononanoato-O)(neoundecanoato-O)lead	93894-64-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1641	Formaldehyde, reaction products with branched and linear heptylphenol, carbon disulfide and hydrazine	93925-00-9	1,000ppm	articles/ chemical products
1642	Phosphoric acid, mixed butyl and hexyl diesters, lead(2+) salts	93925-27-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1643	Fluoranthene-d10	93951-69-0	Intentional addition / 1,000ppm	articles/ chemical products
1644	Lead bis(isoundecanoate)	93965-29-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1645	Lead bis(tricosanoate)	93966-37-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1646	Lead tetracosanoate	93966-38-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1647	Lead pentadecanoate	93966-74-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1648	Lead(II) isooctanoate	93981-67-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1649	Hexacosanoic acid, lead salt	94006-20-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1650	[mu-[[5-Azobis[1H-tetrazolato]](2)-]]dihydroxylead	94015-57-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1651	Mercury thallium dinitrate	94022-47-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1652	[mu-[[Oxydiethylene but-2-enedioato](2)-]]diphenylmercury	94070-92-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1653	Mercury, [mu-[[oxydi-2,1-ethanedyl, 1,2-benzenedicarboxylato-kappa O2](2)-]]diphenyl-	94070-93-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1654	Lead diundec-10-enoate	94232-40-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1655	Sulfurous acid, mercury(2+) salt (1:1)	94238-21-8	1%	articles/ chemical products
1656	(isononanoato-O)(isooctanoato-O)lead	94246-84-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1657	(isodecanoato-O)(isooctanoato-O)lead	94246-85-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1658	(isodecanoato-O)(isononanoato-O)lead	94246-86-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1659	(isodecanoato-O)(neodecanoato-O)lead	94246-87-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1660	(2-ethylhexanoato-O)(isooctanoato-O)lead	94246-90-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1661	(2-ethylhexanoato-O)(isononanoato-O)lead	94246-91-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1662	(2-ethylhexanoato-O)(isodecanoato-O)lead	94246-92-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1663	(2-ethylhexanoato-O)(neodecanoato-O)lead	94246-93-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1664	Lead icosanoate (1:2)	94266-31-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1665	Lead icosanoate	94266-32-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1666	Bis(5-oxo-DL-prolinato-N1,O2)mercury	94276-38-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1667	Fatty acids, tallow, reaction products with lead oxide	94349-78-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1668	(isononanoato-O)(neodecanoato-O)lead	94481-58-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1669	Bis(5-oxo-L-prolinato-N1,O2)mercury	94481-62-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1670	2,4',7-trichlorobiphenyl	94487-00-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1671	Lead hydroxide thiocyanate (Pb(OH)(SCN))	94492-43-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1672	Lead, zinc dross	94551-60-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1673	Calcines, lead-zinc ore concentrate	94551-62-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1674	Flue dust, steel-manufacturing, alkaline press coke - Substance obtained by the alkaline leaching and neutralization sludge treatment of flue dust from the waste gas purification in steel manufacture. Consists primarily of lead and zinc.	94551-64-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1675	Fumes, lead - Residue produced in lead smelting operations from the volatilisation of lead from materials smelted. Consists primarily of chlorides and oxides of antimony, arsenic and zinc.	94551-66-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1676	Leach residues, copper dross carbonate - Residue from treatment of copper dross with ammonium carbonate solution, consists primarily of copper sulfide, lead carbonate, lead oxide and metallic lead.	94551-71-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1677	Leach residues, copper-lead - Substance formed by the oxidative leaching of lead- and copper-containing materials with sulfuric acid. Consists primarily of lead sulfates and other lead compounds with lesser amounts of other non-ferrous compounds.	94551-72-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1678	Leach residues, tin slag - Substance formed by the leaching of chloride-containing salt slag, consists primarily of carbonates, hydroxides and sulfates of lead, tin and zinc as well as additional nonferrous metals.	94551-73-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1679	Matte, copper-lead	94551-74-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1680	Residues, lead smelting wastewater treatment - Material obtained during waste water treatment in lead production, consists primarily of lead with additional metal carbonates, hydroxides, sulfides or sulfates.	94551-78-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1681	Residues, lead-zinc smelting wastewater treatment	94551-79-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1682	Slags, tin-refining - Substance formed during the refining of tin or tin solder with chlorine, consists primarily of chlorine compounds of lead, tin and zinc and contains other nonferrous chlorides and oxides.	94551-86-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1683	Solders, dross - Oxides formed during the melting and use of solders for the electronics industry. Consists primarily of oxides of tin, lead and antimony with some silver and gold.	94551-97-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1684	Wastes, lead battery reprocessing	94551-99-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1685	Wastes, terne plating - Waste material obtained from the terne coating of steel. Consists primarily of zinc chloride with traces of lead and zinc.	94552-00-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1686	Waste solids, lead silver anode	94552-05-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1687	Stannane, [(1-oxoundecyl)oxy]triphenyl-	94850-90-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1688	Spinel, copper green - An inorganic pigment that is the reaction product of high temperature calcination in which copper oxides, silicon oxide and/or aluminum oxide in varying amounts are homogeneously and ionically interdiffused to form a crystalline matrix of spinels. Its composition may include any one or a combination of the modifiers vanadium oxide, titanium oxide, antimony oxide, lead oxide, and alkali and alkaline earth oxides.	95046-49-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1689	1,3-Isobenzofurandione, hexahydro-	95327-28-9	1,000ppm	articles/ chemical products
1690	Enczacamene, (+)	95342-41-9	1,000ppm	articles/ chemical products
1691	Methanesulfonic acid, lead salt	95860-12-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1692	Lead(2+) isohexadecanoate	95892-13-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1693	Lead, di-mu-hydroxy[2-methyl-4,6-dinitrophenolato-O](nitro-O)di-	96471-22-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1694	1,1'-Biphenyl, 2,3,4,4,5-pentabromo-	96551-70-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1695	Slimes and Sludges, lead acetate manufacture	96690-46-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1696	Thiosulfuric acid (H2S2O3), mercury(2+) salt (1:1)	96906-16-0	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
1697	1,1'-Biphenyl, 2,2',4,6'-tetrabromo-	97038-95-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1698	1,1'-Biphenyl, 2,2',6,6'-tetrabromo-	97038-96-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1699	1,1'-Biphenyl, 2,2',4,4',6-pentabromo-	97038-97-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1700	1,1'-Biphenyl, 3,3',4,5'-tetrabromo-	97038-98-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1701	1,1'-Biphenyl, 2,2',4,6,6'-pentabromo-	97063-75-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1702	2,3,7-(or 3,4,7')-trichlorobiphenyl	97122-18-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1703	2,4,7'(2,6,7' or 3,5,7')-trichlorobiphenyl	97122-20-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1704	1,3-Isobenzofurandione, hexahydro-, trans-±-	97233-90-4	1,000ppm	articles/ chemical products
1705	Paraffins (petroleum), normal C10-10, chloro	97553-43-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1706	Alkanes, C10-26, chloro	97659-46-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1707	Lead, bullion	97808-20-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1708	Lead fluoride hydroxide	97899-90-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1709	7-methyloctanoic acid, lead salt	97952-39-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1710	Nitric acid, lead(2+) salt, reaction products with sodium tin oxide	97953-08-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1711	Fatty acids, C8-12, pentachlorophenyl esters	98219-40-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1712	Fatty acids, C16-18, pentachlorophenyl esters	98219-41-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1713	Ethanaminium, N,N,N-triethyl-, salt with pentadecafluorooctanoic acid (1:1)	98241-25-9	1,000ppm	articles/ chemical products
1714	Speiss, lead, nickel-containing	98246-91-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1715	Sulfuric acid, barium salt (1:1), lead-doped	98328-54-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1716	(±)-2,2',3,4,6'-Pentachlorobiphenyl	99554-08-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1717	(±)-2,2',3,4,4',6'-Hexachlorobiphenyl	99554-09-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1718	(+)-2,2',3,4,6'-pentachlorobiphenyl	99554-10-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1719	(-)-2,2',3,4,6'-pentachlorobiphenyl	99554-11-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1720	(+)-2,2',3,4,4',6'-hexachlorobiphenyl	99554-12-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1721	(-)-2,2',3,4,4',6'-hexachlorobiphenyl	99554-13-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1722	Perchloric acid, reaction products with lead oxide and triethanolamine	99749-31-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1723	Silicic acid, calcium salt (1:1), lead and manganese-doped	100402-96-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1724	Residues, zinc refining flue dust wastewater, mercury-selenium	100403-63-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1725	Phenol, 4-(5-methylhexyl)-	100532-36-3	Intentional addition	articles/ chemical products
1726	Lead, dross, vanadium-zinc-containing	100656-49-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1727	Matte, copper-lead, tellurium-containing	100656-53-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1728	Flue dust, copper-lead blast furnace, cadmium-indium-enriched	100656-55-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1729	Ashes (residues), tin-refining (Ashes and waste metals obtained from melting or refining of lead, tin and other alloys. Composed primarily of tin with high oxides of other metals.)	100656-56-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1730	Lead(II) 2-hydroxy-2-methylpropionate	100929-97-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1731	Lead, isodecanoate naphthenate complexes, basic	101012-92-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1732	Lead, isooctanoate neodecanoate complexes	101013-06-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1733	Phosphoric acid, calcium salt (1:1), solid solution with calcium chloride, calcium fluoride, calcium oxide, phosphorus oxide (P2O5) and strontium oxide, lead and manganese-doped	102047-25-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1734	Barium oxide (BaO), solid solution with calcium oxide, strontium oxide and tungsten oxide (WO3), lead-doped	102110-24-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1735	Boric acid (H3BO3), solid solution with barium oxide, calcium oxide and strontium oxide, lead and manganese-doped	102110-26-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1736	Silicic acid, calcium salt, lead and manganese-doped	102110-36-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1737	Lead ores, concentrates, leached	102110-48-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1738	Residues, copper-iron-lead-nickel matte, sulfuric acid-insoluble	102110-49-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1739	Slimes and Sludges, battery scrap, antimony- and lead-rich	102110-60-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1740	Slimes and Sludges, copper concentrate roasting off gas scrubbing, lead-mercury-selenium-containing	102110-61-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1741	Slimes and Sludges, copper-lead ore roasting off gas scrubbing, arsenic-containing	102110-62-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1742	Mercury, ((p-tolyl)sulfamoyl)imino(bis)(methyl)-	102280-93-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1743	1,3-Isobenzofurandione, hexahydro-	102483-85-2	1,000ppm	articles/ chemical products
1744	Phenol, 4-(3-methylhexyl)-	102570-52-5	Intentional addition	articles/ chemical products
1745	3,2',5,5'-Tetrabromodiphenyl ether	103173-66-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1746	Mercury, (2-ethylhexanoato-O)(1-methoxycyclohexyl)-	103332-13-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1747	Mercury, (1-methoxycyclohexyl)(neodecanoato-O)-	103369-15-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1748	Diactadecylmercury	103399-29-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1749	1,2,4,5,7,8-Hexachloronaphthalene	103426-92-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1750	1,2,3,4,5,8-Hexachloronaphthalene	103426-93-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1751	1,2,3,5,7,8-Hexachloronaphthalene	103426-94-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1752	1,2,3,5,6,8-Hexachloronaphthalene	103426-95-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1753	1,2,3,4,6,7-Hexachloronaphthalene	103426-96-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1754	1,2,3,5,6,7-Hexachloronaphthalene	103426-97-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1755	1-Propanesulfonic acid, 2-hydroxy-, lead(2+) salt (2:1)	103427-19-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1756	Mercury, hydroxy(1-methoxyhexyl)-, naphthenate	103458-15-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1757	Mercury, (1-methoxyethyl)(9-octadecenoato-O)-, (Z)-	104325-07-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1758	Mercury, (1-methoxycyclohexyl)(9-octadecenoato-O)-, (Z)-	104325-08-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1759	Mercury, (1-methoxyethyl)(neodecanoato-O)-	104335-53-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1760	Mercury, (2-ethylhexanoato-O)(1-methoxyethyl)-	104339-46-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1761	Alkanes, C10-22, chloro-	104948-36-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1762	Lead fluoride (PbF2.01)	106496-45-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1763	Phenol, p-sec-nonyl-, phosphite (TNPP)	106599-06-8	Intentional addition / 1,000ppm	articles/ chemical products
1764	2,2',3,4,4',5'(or 2,2',3,4,4',5')-hexachlorobiphenyl	108145-39-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1765	Alkanes, C10-12, chloro	108171-26-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1766	Lead molybdenum oxide (Pb0.51Mo0.49O1.98)	108424-14-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1767	Lead molybdenum oxide (Pb0.49-0.51Mo0.49-0.51O1.98-2.02)	108424-15-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1768	Lead molybdenum oxide (Pb0.49Mo0.51O2.02)	108424-16-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1769	1-Butanaminium, N,N,N-tributyl-, salt with 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonic acid	108427-54-9	1,000ppm	articles/ chemical products
1770	Ethanaminium, N,N,N-triethyl-, salt with 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonic acid (1:1)	108427-55-0	1,000ppm	articles/ chemical products
1771	1,3-Isobenzofurandione, hexahydro-	109265-67-0	1,000ppm	articles/ chemical products
1772	(R)-2,2',3,3',4,4',6,6'-octachlorobiphenyl	109328-45-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1773	(S)-2,2',3,3',4,4',6,6'-octachlorobiphenyl	109328-46-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1774	Diamylthiocarbamate, lead	109707-90-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1775	Lead(II) hydrogen arsenite	109882-46-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1776	Decabromodiphenyl oxide	109945-70-2	1,000ppm	articles/ chemical products
1777	Undecanoic acid, 2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,11-heneicosafuoro-	110961-38-1	1,000ppm	articles/ chemical products
1778	2,2',3,6,6',7'-hexachlorobiphenyl	111276-74-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1779	2,4,4',7',7'-pentachlorobiphenyl	111276-75-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1780	2,2',6,7',7'-pentachlorobiphenyl	111276-76-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1781	2,2',5,6,7',7'-hexachlorobiphenyl	111276-77-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1782	2,7,7'-trichlorobiphenyl	111276-78-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1783	4,4',7',7',7'-hexachlorobiphenyl	111276-79-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1784	2,2',5,6',7',7'-heptachlorobiphenyl	111276-80-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1785	4,4',7',7',7'-pentachlorobiphenyl	111276-81-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1786	2,3,3',4,4',5,5',7'-octachlorobiphenyl	111276-82-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1787	2,2',5,6',7',7'-octachlorobiphenyl	111276-83-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1788	1,3-Isobenzofurandione, hexahydro-, (3aR,7aS)-rel	111720-41-3	1,000ppm	articles/ chemical products
1789	1-Propanesulfonic acid, 2-hydroxy-, lead salt	114601-64-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1790	Cyclotetrasiloxane-2,2,4,4,6,6,8,8-octol, lead(2+) salt (1:2)	114830-97-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1791	Lead sulfomolybdochromate, silica encapsulated	116585-73-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1792	Chromium lead oxide sulfate, silica-modified	116585-74-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1793	Lead silicon oxide (Pb0.18Si0.82O1.82)	116686-25-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1794	Bismuth lead strontium calcium copperoxide	116739-98-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1795	Benzene, 1,2,4,5-tetrabromo-3-(2,4,6-tribromophenoxy)-	116995-32-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1796	Benzene, 1,2,4,5-tetrabromo-3-(2,4-dibromophenoxy)-	116995-33-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1797	1,3-Isobenzofurandione, hexahydro-	117276-22-9	1,000ppm	articles/ chemical products
1798	Benzene, 1,2,3,5-tetrabromo-4-(2,4,6-tribromophenoxy)-	117948-63-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1799	2,2',3,3',4,6'-Hexabromobiphenyl	119264-50-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1800	2,2',3,3',5,6'-Hexabromobiphenyl	119264-51-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1801	2,2',3,4,5,6'-Hexabromobiphenyl	119264-52-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1802	2,2',3,5,5',6'-Hexabromobiphenyl	119264-53-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1803	2,2',3,4,5,5'-Hexabromobiphenyl	120991-47-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1804	2,3,3',4,5,5'-Hexabromobiphenyl	120991-48-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1805	Lead oxide (PbO1-2)	121054-00-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1806	Lead molybdenum oxide (PbMo5O8)	121072-42-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1807	Phenol, dodecyl-, branched	121158-58-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1808	Lead oxide (PbO1.62)	122162-56-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1809	Phenol, tetrapropylene-, lead(2+) salt	122332-23-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1810	Propanoic acid, 2,3,3,3-tetrafluoro-2-(1,1,2,2,3,3,3,3-heptafluoropropoxy)-, ion(1-)	122499-17-6	1,000ppm	articles/ chemical products
1811	Lead molybdenum oxide (Pb0.05Mo0.31O0.64)	123517-46-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1812	Silicic acid (H4SiO4), lead(2+) salt (2:3)	124826-86-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1813	Sodium perborate hexahydrate	125022-34-6	1,000ppm	articles/ chemical products
1814	Fatty acids, C4-20-branched, lead salts	125328-49-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1815	Lead, C9-28-neocarboxylate 2-ethylhexanoate complexes, basic	125494-56-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1816	Benzenesulfonic acid, 2-hydroxy-, lead(2+) salt (2:1)	126857-68-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1817	Nitric acid, mercury(2+) salt, hydrate	127026-24-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1818	Poly(oxy-1,2-ethanediyloxy), alpha-(4-nonylphenyl)-omega-hydroxy-, branched	127087-87-0	Intentional addition / 100ppm	articles/ chemical products
1819	Strychnine, complex with mercury thiocyanate	127620-35-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1820	Tetrakis(4-dimethylamino)phenyllead	127917-29-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1821	1,3-Isobenzofurandione, hexahydro-, (3aR,7aS)-rel	127946-28-5	1,000ppm	articles/ chemical products
1822	1,3-Isobenzofurandione, hexahydro-, (3aR,7aR)-rel	128049-67-2	1,000ppm	articles/ chemical products
1823	Ethanedioic acid, lead(2+) salt (1:1), trihydrate	128226-81-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1824	Hexanoic acid, 3,5-dimethyl-, lead(2+) salt	130596-72-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1825	Lead oxide (PbO1.37)	130680-19-2	Contains (regardless of intentional or impurities)	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
1826	Cadmium manganese mercury telluride (Cd0.2Mn0.04Hg0.76Te)	131500-00-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1827	Lead oxide (PbO1.01-1.99)	132003-12-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1828	Lead oxide (PbO1.57)	133315-99-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1829	Mercury, (2-ethylhexanoato-O)(2-methoxy-2-phenylethyl)-	133350-44-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1830	Mercury, (neo-decanoato-O)(2-methoxy-2-phenylethyl)-	133350-45-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1831	Mercury, 2-methoxy-2-phenylethyl naphthenate complexes	133421-58-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1832	2-Propanesulfonic acid, 1-hydroxy-(mixtures)	133988-90-6	Intentional addition / 1,000ppm	articles/ chemical products
1833	Cyclododecane, 1,2,5,6,9,10-hexabromo-, (1R,2S,5R,6R,9R,10S)-rel-	134237-50-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1834	Cyclododecane, 1,2,5,6,9,10-hexabromo-, (1R,2S,5R,6R,9R,10S)-rel-	134237-51-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1835	Cyclododecane, 1,2,5,6,9,10-hexabromo-, (1R,2S,5R,6S,9S,10R)-rel-	134237-52-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1836	1,4,7,10-Dimethanodibenzo[a,e]cyclooctene, 1,2,3,4,7,8,9,10,13,14,14-dodecachloro-1,4,4a,5,6,6a,7,10,10a,11,12,12a-dodecachloro-, (1R,4S,4aS,6aR,7R,10S,10aS,12aR)-rel-	135821-03-3	Intentional addition / 100ppm	articles/ chemical products
1837	1,4,4a,5,6,6a,7,10,10a,11,12,12a-dodecachloro-1,4,7,10-dimethanodibenzo[a,e]cyclooctene	135821-74-8	Intentional addition / 900ppm	articles/ chemical products
1838	Lead molybdenum oxide (Pb3Mo16O24)	135849-93-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1839	Cyclododecane, 1,2,5,6,9,10-hexabromo-, (1R,2R,5R,6S,9S,10S)-	138257-17-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1840	(-)-beta-Hexabromocyclododecane	138257-18-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1841	(+)-alpha-Hexabromocyclododecane	138257-19-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1842	Plumbate(2-), [[N-1,2-ethanedithylbis(N-(carboxymethyl)glycinate)[4]-N,N',O,O',NN,ON]], calcium (1:1), pentahydrate, (OC-6-21)-	139522-21-7	Intentional addition	articles/ chemical products
1843	Plumbate(2-), [[N-1,2-ethanedithylbis(N-(carboxymethyl)glycinate)[4]-N,N',O,O',NN,ON]], strontium (1:1), trihydrate, (OC-6-21)-	139522-22-8	Intentional addition	articles/ chemical products
1844	Lead ionophore III	141754-61-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1845	4-(3,6-Dimethyl-3-heptyl)phenol	142731-63-3	Intentional addition / 1,000ppm	articles/ chemical products
1846	Refractory ceramic fibers	142844-00-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1847	Oxazolidine, 3-ethyl-2-methyl-2-(3-methylbutyl)-	143860-04-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1848	Sulfonium, triphenyl-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	144116-10-9	Intentional addition / 1,000ppm	articles/ chemical products
1849	Decabromodiphenyl oxide	145538-74-5	Intentional addition / 1,000ppm	articles/ chemical products
1850	1,2,3,6-Tetrachloronaphthalene	149864-78-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1851	1,2,6,7-Tetrachloronaphthalene	149864-79-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1852	1,2,5,8-Tetrachloronaphthalene	149864-80-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1853	1,2,3,8-Tetrachloronaphthalene	149864-81-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1854	1,2,7,8-Tetrachloronaphthalene	149864-82-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1855	Naphthalene, 1,2,3,7,8-pentachloro-	150205-21-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1856	1,3,6,8-Tetrachloronaphthalene	150224-15-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1857	1,2,3,6,7-Pentachloronaphthalene	150224-16-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1858	1,2,4,6,7-Pentachloronaphthalene	150224-17-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1859	1,2,3,5,6-Pentachloronaphthalene	150224-18-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1860	1,2,4,5,7-Pentachloronaphthalene	150224-19-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1861	1,2,4,5,6-Pentachloronaphthalene	150224-20-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1862	1,2,4,7,8-Pentachloronaphthalene	150224-21-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1863	1,2,4,6,8-Pentachloronaphthalene	150224-22-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1864	1,2,3,5,8-Pentachloronaphthalene	150224-23-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1865	1,2,3,5,8-Pentachloronaphthalene	150224-24-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1866	1,2,4,5,8-Pentachloronaphthalene	150224-25-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1867	(+)-2,2,3,6-tetrachlorobiphenyl	151262-31-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1868	(-)-2,2,3,6-tetrachlorobiphenyl	151262-32-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1869	(+)-2,2,3,5,6-pentachlorobiphenyl	151262-34-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1870	(-)-2,2,3,5,6-pentachlorobiphenyl	151262-35-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1871	Slimes and Sludges, mercury concentrated roasting off gas condensate (A mercury slime formed by the condensation of mercury ore concentrate roasting off gas. It contains mercury in the form of HgS, and also contains sulfuric acid, as well as Cd, Fe, Pb, Se, and Zn.)	152923-45-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1872	(S)-2,2',3,3',6'-pentachlorobiphenyl	153153-43-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1873	(R)-2,2',3,3',6'-pentachlorobiphenyl	153153-44-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1874	(S)-2,2',3,3',4',6'-hexachlorobiphenyl	153153-45-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1875	(R)-2,2',3,3',4',6'-hexachlorobiphenyl	153153-46-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1876	(S)-2,2',3,3',4',6'-hexachlorobiphenyl	153153-47-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1877	(R)-2,2',3,3',4',6'-hexachlorobiphenyl	153153-48-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1878	(S)-2,2',3,3',6,6'-hexachlorobiphenyl	153153-49-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1879	(R)-2,2',3,3',6,6'-hexachlorobiphenyl	153153-50-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1880	Iodonium, diphenyl-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	153443-35-7	Intentional addition / 1,000ppm	articles/ chemical products
1881	Ethanol, 2-[2-(4-tert-nonylphenoxy)ethoxy]-	156609-10-8	Intentional addition / 1,000ppm	articles/ chemical products
1882	(R)-2,2',3,4',5',6'-hexachlorobiphenyl	159000-96-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1883	(S)-2,2',3,4',5',6'-hexachlorobiphenyl	159000-97-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1884	Cyclododecane, 1,2,5,6,9,10-hexabromo-, [(1R)-(1R*2S*5S*6S*9S*10R*)]-	169102-57-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1885	Polymer(lead[2+] methacrylate/methylmethacrylate/poly[2-60][ethylene glycol dimethacrylate]/styrene)	172589-69-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1886	Lead N-ethyl-N-cyclohexyldithiocarbamate	172777-22-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1887	Slags, lead smelting, zinc-reduced	175448-53-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1888	(R)-2,2',3,3',4,4',6'-heptachlorobiphenyl	176914-46-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1889	(R)-2,2',3,3',4,4',5',6'-heptachlorobiphenyl	176914-47-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1890	(S)-2,2',3,3',4,4',6'-heptachlorobiphenyl	176914-48-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1891	(S)-2,2',3,3',4,4',5',6'-heptachlorobiphenyl	176914-49-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1892	(R)-2,2',3,3',4,4',5,6'-octachlorobiphenyl	177020-15-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1893	(S)-2,2',3,3',4,4',5,6'-octachlorobiphenyl	177020-16-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1894	3,6-Didodecyloxy-4,5-dimethyl-o-phenylene-bis(mercury chloride)	178959-28-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1895	(R)-2,2',3,3',4,6'-hexachlorobiphenyl	179678-26-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1896	(S)-2,2',3,3',4,6'-hexachlorobiphenyl	179678-27-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1897	(R)-2,2',3,3',4,5,6'-heptachlorobiphenyl	179678-28-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1898	(S)-2,2',3,3',4,5,6'-heptachlorobiphenyl	179678-29-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1899	(R)-2,2',3,3',4,5',6'-heptachlorobiphenyl	179678-30-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1900	(S)-2,2',3,3',4,5',6'-heptachlorobiphenyl	179678-31-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1901	(R)-2,2',3,3',4,6,6'-heptachlorobiphenyl	179678-32-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1902	(S)-2,2',3,3',4,6,6'-heptachlorobiphenyl	179678-33-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1903	Bis(tetramethylheptanedionato)lead-pentamethyldiethylenetriamine adduct	180129-52-6	Intentional addition / 1,000ppm	articles/ chemical products
1904	1,3-Dioxane, 2-(2,4-dimethyl-3-cyclohexen-1-yl)-5-methyl-5-(1-methylpropyl)-	186309-28-4	Intentional addition / 1,000ppm	articles/ chemical products
1905	4-(3,5-Dimethyl-3-heptyl)phenol	186825-36-5	Intentional addition / 1,000ppm	articles/ chemical products
1906	Benzene, pentabromophenoxy-	189084-65-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1907	Methanaminium, N,N,N-trimethyl-, salt with 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonic acid (1:1)	189274-31-5	Intentional addition / 1,000ppm	articles/ chemical products
1908	Tetradecane, chloro derivatives	198840-65-2	1,000ppm	articles/ chemical products
1909	Barium calcium cesium lead samarium strontium bromide chloride fluoride iodide europium doped	199876-46-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1910	Tri(O-tolyl)lead	201742-34-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1911	1,3-Isobenzofurandione, hexahydro-, (3aR,7aS)-rel	201815-17-0	Intentional addition / 1,000ppm	articles/ chemical products
1912	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, compound with 2-methyl-2-propanamine (1:1)	202189-84-2	Intentional addition / 1,000ppm	articles/ chemical products
1913	(R)-2,2',3,3',5,6'-hexachlorobiphenyl	205991-67-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1914	(S)-2,2',3,3',5,6'-hexachlorobiphenyl	205991-68-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1915	(R)-2,2',3,3',5,6'-hexachlorobiphenyl	205991-69-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1916	(S)-2,2',3,3',5,6'-hexachlorobiphenyl	205991-70-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1917	(+)-2,2',3,3',6-pentachlorobiphenyl	207004-27-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1918	(+)-2,2',3,3',6'-hexachlorobiphenyl	207004-28-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1919	(-)-2,2',3,3',6'-hexachlorobiphenyl	207004-29-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1920	(+)-2,2',3,3',6'-hexachlorobiphenyl	207004-30-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1921	(-)-2,2',3,3',4,5,6'-heptachlorobiphenyl	207004-31-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1922	(+)-2,2',3,3',4,5,6'-heptachlorobiphenyl	207004-32-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1923	(+)-2,2',3,3',4,6-hexachlorobiphenyl	207004-33-9	Contains (regardless of intentional or impurities)	articles/ chemical products
1924	(+)-2,2',3,3',4,5,6'-heptachlorobiphenyl	207004-34-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1925	(+)-2,2',3,3',4,4',5,6'-octachlorobiphenyl	207004-35-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1926	(+)-2,2',3,4',5,6-hexachlorobiphenyl	207004-36-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1927	1,3,5-Tribromo-2-(2,4,5-tribromophenoxy)benzene	207122-15-4	Contains (regardless of intentional or impurities)	articles/ chemical products
1928	1,2,3,5-Tetrabromo-4-(2,4,5-tribromophenoxy)benzene	207122-16-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1929	Lead(II) perchlorate hydrate	207500-00-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1930	Phenol, 4-dodecyl-, branched	210555-94-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1931	Iodonium, bis[4-(1,1-dimethylethyl)phenyl]-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	213740-81-9	Intentional addition / 1,000ppm	articles/ chemical products
1932	Undecane, heptachloro-	219697-10-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1933	Undecane, nonachloro-	219697-11-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1934	Undecane, 1,2,10,11,11,11,11-octachloro-	221174-07-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1935	(+)-2,2',3,3',4,5,6'-hexachlorobiphenyl	228420-06-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1936	(+)-2,2',3,3',4,5,6'-heptachlorobiphenyl	228420-07-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1937	2,2',3,4,5,6-Heptabromobiphenyl	245657-57-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1938	1-Decanaminium, N-decyl-N,N-dimethyl-, salt with 1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8-heptadecafluoro-1-octanesulfonic acid (1:1)	251099-16-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1939	Phosphorodithioic acid, mixed O,O-bis(2-ethylhexyl and isobutyl and isopropyl) S-[3a,4,5,6,7,7a-hexahydro-4,7-methano-1H-inden-5(or 6)-yl] esters	255881-94-8	Intentional addition / 1,000ppm	articles/ chemical products
1940	Undecane, decachloro-	276673-33-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1941	1,3-Isobenzofurandione, hexahydro-, (3aR,7aS)-rel	279240-32-3	Intentional addition / 1,000ppm	articles/ chemical products
1942	Phenol, 4-tert-heptyl-	288864-02-8	Intentional addition	articles/ chemical products
1944	Perchloric acid, mercuric(2+) salt, monohydrate	304656-34-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1945	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, gallium salt	341035-71-0	Intentional addition / 1,000ppm	articles/ chemical products
1946	Sulfonium, bis(4-methylphenyl)phenyl-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	341548-85-4	Intentional addition / 1,000ppm	articles/ chemical products
1948	1,3-Dioxane, 2-[(1R,2R)-2,4-dimethyl-3-cyclohexen-1-yl]-5-methyl-5-(1-methylpropyl)-, cis-rel-	343934-04-3	Intentional addition / 1,000ppm	articles/ chemical products
1949	1,3-Dioxane, 2-[(1R,2R)-2,4-dimethyl-3-cyclohexen-1-yl]-5-methyl-5-(1-methylpropyl)-, trans-rel-	343934-05-4	Intentional addition / 1,000ppm	articles/ chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
1948	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro- scandium(3+) salt (3:1)	350836-93-0	Intentional addition / 1,000ppm	articles/ chemical products
1949	Sulfonium, thiodi-(4-1-phenylene)bis(diphenyl)-, salt with 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonic	421555-73-9	Intentional addition / 1,000ppm	articles/ chemical products
1950	Iodonium, bis[4-(1,1-dimethylpropyl)phenyl]-, salt with 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonic	421555-74-0	Intentional addition / 1,000ppm	articles/ chemical products
1951	Sulfonium, tris[4-(1,1-dimethylethyl)phenyl]-, salt with 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonic	425670-70-8	Intentional addition / 1,000ppm	articles/ chemical products
1952	Lead, bis(2,6-dimethyl-3,5-heptanedionato-kappa O,kappa O')-(T-4)-	444279-15-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1953	1,2,3,5-Tetrabromo-4-(2,3,5-tribromophenoxy)benzene	446255-22-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1954	2,2,3,3,4,5,6-Heptabromobiphenyl	475200-12-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1955	Undecane, 1,1,1,3,6,10,11-octachloro-	601523-20-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1956	Undecane, 1,1,1,3,9,11,11,11-octachloro-	601523-25-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1957	Bis(2-nitro-kappa O)-4-nitrophenolato-kappa O'-lead	625080-35-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1958	1,3-Isobenzofurandione, hexahydro-, (3aR,7aS)-rel	634193-83-2	Intentional addition / 1,000ppm	articles/ chemical products
1959	1,3-Dioxane, 2-[[[(1S,2S)-2,4-dimethyl-3-cyclohexen-1-yl]-5-methyl-5-(1-methylpropyl)-, cis-	676367-02-5	Intentional addition / 1,000ppm	articles/ chemical products
1960	1,3-Dioxane, 2-[[[(1S,2R)-2,4-dimethyl-3-cyclohexen-1-yl]-5-methyl-5-(1-methylpropyl)-, cis-	676367-03-6	Intentional addition / 1,000ppm	articles/ chemical products
1961	1,3-Dioxane, 2-[[[(1R,2S)-2,4-dimethyl-3-cyclohexen-1-yl]-5-methyl-5-(1-methylpropyl)-, cis-	676367-04-7	Intentional addition / 1,000ppm	articles/ chemical products
1962	1,3-Dioxane, 2-[[[(1R,2R)-2,4-dimethyl-3-cyclohexen-1-yl]-5-methyl-5-(1-methylpropyl)-, cis-	676367-05-8	Intentional addition / 1,000ppm	articles/ chemical products
1963	1,3-Dioxane, 2-[[[(1S,2S)-2,4-dimethyl-3-cyclohexen-1-yl]-5-methyl-5-(1-methylpropyl)-, trans-	676367-06-9	Intentional addition / 1,000ppm	articles/ chemical products
1964	1,3-Dioxane, 2-[[[(1S,2R)-2,4-dimethyl-3-cyclohexen-1-yl]-5-methyl-5-(1-methylpropyl)-, trans-	676367-07-0	Intentional addition / 1,000ppm	articles/ chemical products
1965	1,3-Dioxane, 2-[[[(1R,2S)-2,4-dimethyl-3-cyclohexen-1-yl]-5-methyl-5-(1-methylpropyl)-, trans-	676367-08-1	Intentional addition / 1,000ppm	articles/ chemical products
1966	1,3-Dioxane, 2-[[[(1R,2R)-2,4-dimethyl-3-cyclohexen-1-yl]-5-methyl-5-(1-methylpropyl)-, trans-	676367-09-2	Intentional addition / 1,000ppm	articles/ chemical products
1967	Cyclododecane, 1,2,5,6,9,10-hexabromo-, (1R,2R,5S,6R,9R,10S)-	678970-15-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1968	Cyclododecane, 1,2,5,6,9,10-hexabromo-, (1R,2S,5R,6S,9S,10S)-	678970-16-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1969	Cyclododecane, 1,2,5,6,9,10-hexabromo-, (1R,2R,5S,6R,9R,10R)-	678970-17-7	Contains (regardless of intentional or impurities)	articles/ chemical products
1970	(1R,4S)-1,7,7-Trimethyl-3-(4-methylbenzylidene)bicyclo[2.2.1]heptan-2-one	741687-98-9	1,000ppm	articles/ chemical products
1971	1,3-Isobenzofurandione, hexahydro-, (3aR,7aS)-rel	743438-36-0	Intentional addition / 1,000ppm	articles/ chemical products
1972	Mercury arsenide	749262-24-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1973	n-Pentyl isopentyl phthalate	776297-69-9	Intentional addition / 1,000ppm	articles/ chemical products
1974	(1R,3Z,4S)-1,7,7-Trimethyl-3-(4-methylbenzylidene)bicyclo[2.2.1]heptan-2-one	852541-21-0	1,000ppm	articles/ chemical products
1975	(1S,3Z,4R)-1,7,7-Trimethyl-3-(4-methylbenzylidene)bicyclo[2.2.1]heptan-2-one	852541-25-4	1,000ppm	articles/ chemical products
1976	enzacamene, (-)	852541-30-1	1,000ppm	articles/ chemical products
1977	Phenol, 4-(1-ethyl-3-methylbutyl)-	854904-92-0	Intentional addition	articles/ chemical products
1978	Phenol, 4-(1,2-dimethylpentyl)-	854904-93-1	Intentional addition	articles/ chemical products
1979	2,3,4-Tribromobiphenyl	855255-46-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1980	2,4,4',5'-Tetrabromobiphenyl	855255-51-5	Contains (regardless of intentional or impurities)	articles/ chemical products
1981	2,3,4,4'-Tetrabromobiphenyl	855255-52-6	Contains (regardless of intentional or impurities)	articles/ chemical products
1982	Phenol, 4-(1,4-dimethylpentyl)-	857629-71-1	Intentional addition	articles/ chemical products
1983	Phenol, 4-(1-ethyl-2,2-dimethylpropyl)-	861010-65-3	Intentional addition	articles/ chemical products
1984	Phenol, 4-(1,1,2-trimethylbutyl)-	861011-60-1	Intentional addition	articles/ chemical products
1985	Iodonium, bis[(1,1-dimethylethyl)phenyl]-, salt with 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonic acid (1:1)	866621-50-3	Intentional addition / 1,000ppm	articles/ chemical products
1986	Chlorinated paraffins (C10-13)	866758-65-8	Contains (regardless of intentional or impurities)	articles/ chemical products
1987	Sulfonium, (4-methylphenyl)diphenyl-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	910606-39-2	1,000ppm	articles/ chemical products
1988	Sulfonium, [4-[[[2-methyl-1-oxo-2-propen-1-yl]oxy]phenyl]diphenyl-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	911027-68-4	1,000ppm	articles/ chemical products
1989	Sulfonium, [4-[[[2-methyl-1-oxo-2-propenyl]oxy]phenyl]diphenyl-, salt with 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonic acid (1:1)	911027-69-5	1,000ppm	articles/ chemical products
1990	Phenol, 4-(3-ethylpentyl)-	911370-98-4	Intentional addition	articles/ chemical products
1991	Phenol, 4-(1,2,2-trimethylbutyl)-	911371-06-7	Intentional addition	articles/ chemical products
1992	Phenol, 4-(1,3,3-trimethylbutyl)-	911371-07-8	Intentional addition	articles/ chemical products
1993	2,3',4,4',5,5',6'-Octabromobiphenyl	915039-12-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1994	Dibenzofulvalene, 1,7,10,13-tetraoxa[1,3]dioxacyclopentadecim, 19-[4-(1,1-dimethylethyl)phenyl]-6,7,9,10,12,13-hexahydro-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	928049-42-7	1,000ppm	articles/ chemical products
1995	2,2',3,3',4,4',5,5',6'-Heptabromobiphenyl	942505-32-0	Contains (regardless of intentional or impurities)	articles/ chemical products
1996	2,2',3,3',4,4',5,5',6'-Heptabromobiphenyl	942505-33-1	Contains (regardless of intentional or impurities)	articles/ chemical products
1997	2,2',3,3',4,4',5,5',6'-Heptabromobiphenyl	942505-34-2	Contains (regardless of intentional or impurities)	articles/ chemical products
1998	2,3',3',4,4',5,5',6'-Heptabromobiphenyl	942505-35-3	Contains (regardless of intentional or impurities)	articles/ chemical products
1999	2,2',3,3',4,4',5,5',6'-Octabromobiphenyl	942505-36-4	Contains (regardless of intentional or impurities)	articles/ chemical products
2000	2,3,3',4'-Tetrabromobiphenyl	945669-03-4	Contains (regardless of intentional or impurities)	articles/ chemical products
2001	2,2',3,3',6,6'-Hexabromobiphenyl	955955-53-0	Contains (regardless of intentional or impurities)	articles/ chemical products
2002	Phosphonium, triphenyl(phenylmethyl)-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	1000597-52-3	1,000ppm	articles/ chemical products
2003	Phenol, 4-(4-methylhexyl)-	1139800-98-8	Intentional addition	articles/ chemical products
2004	1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, compound with pyrrolidine (1:1)	1187817-57-7	1,000ppm	articles/ chemical products
2005	Benzene, 1,1'-oxybis[2,3,4,5,6-pentabromo-]	1201677-32-8	1,000ppm	articles/ chemical products
2006	Lanthanum lead titanium zirconium oxide	1227908-26-0	Contains (regardless of intentional or impurities)	articles/ chemical products
2007	Calcium cobalt lead strontium titanium tungsten oxide	1262279-30-0	Contains (regardless of intentional or impurities)	articles/ chemical products
2008	Calcium cobalt lead titanium tungsten oxide	1262279-31-1	Contains (regardless of intentional or impurities)	articles/ chemical products
2009	Ethaniminium, N-[4-[[4-(diethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-ethyl-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	1310480-24-0	1,000ppm	articles/ chemical products
2010	Methaniminium, N-[4-[[4-(dimethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-methyl-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	1310480-27-3	1,000ppm	articles/ chemical products
2011	Methaniminium, N-[4-[[4-(dimethylamino)phenyl][4-(phenylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-methyl-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	1310480-28-4	1,000ppm	articles/ chemical products
2012	beta.-Cyclodextrin, compound with 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonic acid ion(1-) (1:1)	1329955-45-0	1,000ppm	articles/ chemical products
2013	gamma.-Cyclodextrin, compound with 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonic acid ion(1-) (1:1)	1329955-69-8	1,000ppm	articles/ chemical products
2014	Alkanes, C14-16, chloro	1372804-76-6	1,000ppm	articles/ chemical products
2015	Quinolinium, 1-(carboxymethyl)-4-[[2-[[4-[[2-(2-diphenylethenyl)phenyl]-1,2,3,3a,4,8b-hexahydrocyclopent[b]indol-7-yl]ethenyl]-, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-1-hexanesulfonate (1:1)	1462414-59-0	Intentional addition / 1,000ppm	articles/ chemical products
2016	Mercury pyrosulfate	1537199-53-3	Contains (regardless of intentional or impurities)	articles/ chemical products
2017	(3E)-1,7,7-Trimethyl-3-(4-methylbenzylidene)bicyclo[2.2.1]heptan-2-one	1782069-81-1	1,000ppm	articles/ chemical products
2018	Phenol, 4-[[2-methyl-1-(1-methylthyl)propyl]-	1824346-00-0	Intentional addition	articles/ chemical products
2019	1,6,7,8,9,14,15,16,17,17,18,18-Dodecachloropentacyclo[12.2.1.1*6,9:0*2,13:0*5,10*]octadeca-7,15-diene, all members	MSM20-02-0083	1,000ppm	articles/ chemical products
2020	4-(1,1,3,3-Tetramethylbutyl)phenol, ethoxylated homologues	MSM20-02-0208	10%	articles/ chemical products
2021	4-(1,1,3,3-Tetramethylbutyl)phenol, ethoxylated polymers	MSM20-02-0209	10%	articles/ chemical products
2022	Comment	MSM20-02-0445	Contains (regardless of intentional or impurities)	articles/ chemical products
2023	Mixture of 4-[[bis-(4-fluorophenyl)methylsilyl]methyl]-4H-1,2,4-triazole and 1-[[bis-(4-fluorophenyl)methylsilyl]methyl]-1H-1,2,4-triazole	MSM20-02-1050	Contains (regardless of intentional or impurities)	articles/ chemical products
2024	o-Dianisidine based azo dyes	MSM20-02-1153	Contains (regardless of intentional or impurities)	articles/ chemical products
2025	Organic tin compounds	MSM20-02-1164	Contains (regardless of intentional or impurities)	articles/ chemical products
2026	Pentachlorophenol esters	MSM20-02-1190	Contains (regardless of intentional or impurities)	articles/ chemical products
2027	Reaction mass of 2-ethylhexyl 10-ethyl-4,4-diethyl-7-oxo-8-oxa-3,5-dithia-4-stannatetradecanoate and 2-ethylhexyl 10-ethyl-4-[[2-[[2-ethylhexyloxy]-2-oxoethyl]thio]-4-octyl-7-oxo-8-oxa-3,5-dithia-4-stannatetradecanoate	MSM20-02-1336	10%	articles/ chemical products
2028	Salts of 3,3'-dichlorobenzidine	MSM20-02-1584	Contains (regardless of intentional or impurities)	articles/ chemical products
2029	Salts of 3,3'-dimethylbenzidine	MSM20-02-1585	Contains (regardless of intentional or impurities)	articles/ chemical products
2030	Salts of benzidine	MSM20-02-1589	Contains (regardless of intentional or impurities)	articles/ chemical products
2031	Salts of dinoseb	MSM20-02-1594	Contains (regardless of intentional or impurities)	articles/ chemical products
2032	Salts of pentachlorophenol	MSM20-02-1609	Contains (regardless of intentional or impurities)	articles/ chemical products
2033	Tributyltin compounds	MSM20-02-1734	Contains (regardless of intentional or impurities)	articles/ chemical products
2034	Tricyclohexyl tin compounds	MSM20-02-1748	1,000ppm	articles/ chemical products
2035	Triethyltin compounds	MSM20-02-1750	1,000ppm	articles/ chemical products
2036	Trimethyltin compounds	MSM20-02-1754	1,000ppm	articles/ chemical products
2037	Trioctyltin compounds	MSM20-02-1761	Contains (regardless of intentional or impurities)	articles/ chemical products
2038	Triphenyltin compounds	MSM20-02-1764	Contains (regardless of intentional or impurities)	articles/ chemical products
2039	Tripropyltin compounds	MSM20-02-1765	1,000ppm	articles/ chemical products
2040	Zinc chromates	MSM20-02-1870	Contains (regardless of intentional or impurities)	articles/ chemical products
2041	Stannane, dioctyl-, bis(fatty acyloxy) derivatives wherein C12 is the predominant carbon number of the fatty acyloxy moiety	MSM21-03-0001	1,000ppm	articles/ chemical products
2042	Phenol, alkylation products (mainly in para position) with C12-rich branched alkyl chains from oligomerisation, covering any individual isomers and/or combinations thereof (PDDP)	MSM21-09-0001	1,000ppm	articles/ chemical products
2043	Medium-chain chlorinated paraffins	MSM21-09-0002	1,000ppm	articles/ chemical products
2044	Dichlorotetradecanes	MSM21-09-0003	1,000ppm	articles/ chemical products
2045	Trichlorotetradecanes	MSM21-09-0004	1,000ppm	articles/ chemical products
2046	Tetrachlorotetradecanes	MSM21-09-0005	1,000ppm	articles/ chemical products
2047	arsenic acid and its salts	SN0009	1,000ppm	articles/ chemical products
2048	Arsenic compounds	SN0010	Contains (regardless of intentional or impurities)	articles/ chemical products
2049	beryllium compounds	SN0014	Contains (regardless of intentional or impurities)	articles/ chemical products
2050	Cadmium compounds	SN0016	Contains (regardless of intentional or impurities)	articles/ chemical products
2051	Chromium (VI) compounds	SN0019	Contains (regardless of intentional or impurities)	articles/ chemical products
2052	lead compounds	SN0023	Intentional addition / 1,000ppm	articles/ chemical products
2053	Mercury compounds	SN0024	Contains (regardless of intentional or impurities)	articles/ chemical products
2054	Nickel compounds	SN0027	Contains (regardless of intentional or impurities)	articles/ chemical products
2055	Salts of 4-Aminobiphenyl(xenylamine); salts of biphenyl-4-ylamine ; salts of xenylamine	SN0044	Contains (regardless of intentional or impurities)	articles/ chemical products
2056	salts of hydrazine	SN0048	Contains (regardless of intentional or impurities)	articles/ chemical products
2057	Salts or derivatives of benzidine	SN0051	Intentional addition / 1,000ppm	articles/ chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
2058	Zirconia Aluminosilicate Refractory Ceramic Fibres are fibres covered by index number 650-017-00-6 in Annex VI, part 3, table 3.1 of Regulation (EC) No 1272/2008 of the European Parliament and of the Council of 16 December 2008 on classification, labelling and packaging of substances and mixtures, and fulfill the three following conditions: a) oxides of aluminium, silicon and zirconium are the main components present (in the fibres) within variable concentration ranges b) fibres have a length weighted geometric mean diameter less two standard geometric errors of 6 or less micrometres (um), c) alkaline oxide and alkali earth oxide (Na2O+K2O+CaO+MgO+BaO) content less or equal to 18% by weight	SN0055	1,000ppm	articles/ chemical products
2059	Polybrominated biphenyls (PBB)	SN0065	Contains (regardless of intentional or impurities)	articles/ chemical products
2060	Triorganotin compounds	SN0068	1,000ppm	articles/ chemical products
2061	Oligomers of chromic acid and dichromic acid	SN0071	Intentional addition / 10%	articles/ chemical products
2062	5-sec-butyl-2-(2,4-dimethylcyclohex-3-en-1-yl)-5-methyl-1,3-dioxane [1], 5-sec-butyl-2-(4,6-dimethylcyclohex-3-en-1-yl)-5-methyl-1,3-dioxane [2] [covering any of the individual stereoisomers of [1] and [2] or any combination thereof]	SN0085	1,000ppm	articles/ chemical products
2063	4-Heptylphenol, branched and linear [substances with a linear and/or branched alkyl chain with a carbon number of 7 covalently bound predominantly in position 4 to phenol, covering also UVGB- and well-defined substances which include any of the individual isomers or a combination thereof]	SN0089	1,000ppm	articles/ chemical products
2064	Salts of Perfluorohexane-1-sulphonic acid	SN0090	10%	articles/ chemical products
2065	Reaction products of 1,3,4-thiadiazolidine-2,5-dithione, formaldehyde and 4-heptylphenol, branched and linear (RP-HP) [with >=0.1% w/w 4-heptylphenol, branched and linear]	SN0091	1,000ppm	articles/ chemical products
2066	Salts and acyl halides of 2,3,3,3-tetrafluoro-2-(heptafluoropropoxy)propionic acid (covering any of their individual isomers and combinations thereof)	SN0098	1,000ppm	articles/ chemical products
2067	Tris(4-nonylphenyl, branched and linear) phosphite (TNPP) with >= 0.1% w/w of 4-nonylphenol, branched and linear (4-NP)	SN0099	1,000ppm	articles/ chemical products
2068	mono-, di- or tri-O-(alkyl) derivatives of (3,3,4,4,5,5,6,6,7,7,8,8,8-tridecafluorooctyl) silanetriol	SN0100	0,3ppm	articles/ chemical products
2069	Salts of 4,4'-Oxydianiline	SN1005	Contains (regardless of intentional or impurities)	articles/ chemical products
2070	Lead alkyls	SN1017	Contains (regardless of intentional or impurities)	articles/ chemical products
2071	salts of 4,4'-Thiodianiline	SN1019	Contains (regardless of intentional or impurities)	articles/ chemical products
2072	Formaldehyde	50-00-0	Contains (regardless of intentional or impurities)	chemical products
2073	Benzoic acid, 2-(acetoxy)-	50-78-2	Contains (regardless of intentional or impurities)	chemical products
2074	2,4-Dinitrophenol	51-28-5	Contains (regardless of intentional or impurities)	chemical products
2075	Urethane	51-79-6	Contains (regardless of intentional or impurities)	chemical products
2076	2-Bromo-2-nitro-1,3-propanediol	52-51-7	Contains (regardless of intentional or impurities)	chemical products
2077	Verapamil	52-53-9	Intentional addition	chemical products
2078	Trichlorfon	52-68-6	Contains (regardless of intentional or impurities)	chemical products
2079	Dibenz[a,h]anthracene	53-70-3	Contains (regardless of intentional or impurities)	chemical products
2080	(-)-Nicotine	54-11-5	Contains (regardless of intentional or impurities)	chemical products
2081	N-Nitrosodiethylamine	55-18-5	Contains (regardless of intentional or impurities)	chemical products
2082	Fenthion	55-38-9	Contains (regardless of intentional or impurities)	chemical products
2083	Nitroglycerin	55-63-0	Contains (regardless of intentional or impurities)	chemical products
2084	Trimethyltin hydroxide	56-24-6	Contains (regardless of intentional or impurities)	chemical products
2085	Parathion	56-38-2	Contains (regardless of intentional or impurities)	chemical products
2086	Coumaphos	56-72-4	Contains (regardless of intentional or impurities)	chemical products
2087	Benzyltrimethyl ammonium chloride	56-93-9	Contains (regardless of intentional or impurities)	chemical products
2088	Cyanide anion	57-12-5	Contains (regardless of intentional or impurities)	chemical products
2089	1,1-Dimethylhydrazine	57-14-7	Contains (regardless of intentional or impurities)	chemical products
2090	Strychnine	57-24-9	Contains (regardless of intentional or impurities)	chemical products
2091	3,3,7,7-Tetraethyl-4,6-dioxo-5-thia-3,7-distanonane 5,5-dioxide	57-52-3	Contains (regardless of intentional or impurities)	chemical products
2092	Beta-Propiolactone	57-57-8	Contains (regardless of intentional or impurities)	chemical products
2093	10,10'-Oxybisphenoxarsine	58-36-6	Contains (regardless of intentional or impurities)	chemical products
2094	Phenol, 4-chloro-3-methyl-	59-50-7	Contains (regardless of intentional or impurities)	chemical products
2095	Mercurate(1-), (4-carboxylatophenyl)chloro-, hydrogen	59-85-8	Contains (regardless of intentional or impurities)	chemical products
2096	Phenylhydrazine hydrochloride	59-88-1	Contains (regardless of intentional or impurities)	chemical products
2097	N-Nitrosomorpholine	59-89-2	Contains (regardless of intentional or impurities)	chemical products
2098	Ethylene diaminetetraacetic acid	60-00-4	Contains (regardless of intentional or impurities)	chemical products
2099	Benzenamine, N,N-dimethyl-4-(phenylazo)-	60-11-7	Contains (regardless of intentional or impurities)	chemical products
2100	2-Mercaptoethanol	60-24-2	Contains (regardless of intentional or impurities)	chemical products
2101	Ethyl ether	60-29-7	Contains (regardless of intentional or impurities)	chemical products
2102	Methylhydrazine	60-34-4	Contains (regardless of intentional or impurities)	chemical products
2103	Acetamide	60-35-5	Contains (regardless of intentional or impurities)	chemical products
2104	Strychnine, sulfate	60-41-3	Contains (regardless of intentional or impurities)	chemical products
2105	Dimethoate	60-51-5	Contains (regardless of intentional or impurities)	chemical products
2106	Amitrole	61-82-5	Contains (regardless of intentional or impurities)	chemical products
2107	Chlormerodrin	62-37-3	Contains (regardless of intentional or impurities)	chemical products
2108	Ethyl methanesulfonate	62-50-0	Contains (regardless of intentional or impurities)	chemical products
2109	Aniline	62-53-3	Contains (regardless of intentional or impurities)	chemical products
2110	Thioacetamide	62-55-5	Contains (regardless of intentional or impurities)	chemical products
2111	Thiourea	62-56-6	Contains (regardless of intentional or impurities)	chemical products
2112	Dichlorvos	62-73-7	Contains (regardless of intentional or impurities)	chemical products
2113	Sodium fluoroacetate	62-74-8	Contains (regardless of intentional or impurities)	chemical products
2114	Methanamine, N-methyl-N-nitroso-	62-75-9	Contains (regardless of intentional or impurities)	chemical products
2115	Ethanedioic acid, disodium salt	62-76-0	Intentional addition / 1,000ppm	chemical products
2116	Carbaryl	63-25-2	Contains (regardless of intentional or impurities)	chemical products
2117	Ethyl alcohol	64-17-5	Contains (regardless of intentional or impurities)	chemical products
2118	Formic acid	64-18-6	Contains (regardless of intentional or impurities)	chemical products
2119	Acetic acid	64-19-7	Contains (regardless of intentional or impurities)	chemical products
2120	Colchicine	64-86-8	Contains (regardless of intentional or impurities)	chemical products
2121	Nicotine sulfate (2:1)	65-30-5	Contains (regardless of intentional or impurities)	chemical products
2122	Nicotine dihydrogen ditartrate	65-31-6	Contains (regardless of intentional or impurities)	chemical products
2123	Methyl methanesulfonate	66-27-3	Contains (regardless of intentional or impurities)	chemical products
2124	Strychnidin-10-one mononitrate	66-32-0	Contains (regardless of intentional or impurities)	chemical products
2125	2,3-Dinitrophenol	66-56-8	Contains (regardless of intentional or impurities)	chemical products
2126	Cycloheximide	66-81-9	Contains (regardless of intentional or impurities)	chemical products
2127	Methanol	67-56-1	Contains (regardless of intentional or impurities)	chemical products
2128	Isopropyl alcohol	67-63-0	Contains (regardless of intentional or impurities)	chemical products
2129	Acetone	67-64-1	Contains (regardless of intentional or impurities)	chemical products
2130	Chloroform	67-66-3	Contains (regardless of intentional or impurities)	chemical products
2131	Hexachloroethane	67-72-1	Contains (regardless of intentional or impurities)	chemical products
2132	Thioglycolic acid	68-11-1	Contains (regardless of intentional or impurities)	chemical products
2133	Vitamin B12	68-19-9	Contains (regardless of intentional or impurities)	chemical products
2134	N-Methyl-N-nitro-N-nitrosoguanidine	70-25-7	Contains (regardless of intentional or impurities)	chemical products
2135	n-Propanol	71-23-8	Contains (regardless of intentional or impurities)	chemical products
2136	1-Butanol	71-26-3	Contains (regardless of intentional or impurities)	chemical products
2137	Benzene	71-43-2	Contains (regardless of intentional or impurities)	chemical products
2138	1,1,1-Trichloroethane	71-55-6	Contains (regardless of intentional or impurities)	chemical products
2139	Methoxychlor	72-43-5	Contains (regardless of intentional or impurities)	chemical products
2140	1,2-Dihydroxyanthraquinone	72-48-0	Contains (regardless of intentional or impurities)	chemical products
2141	DDD	72-54-8	Contains (regardless of intentional or impurities)	chemical products
2142	2,7-Naphthalenedisulfonic acid, 3,3'-[(3,3'-dimethyl[1,1'-biphenyl]-4,4'-diyl)bis(azo)]bis[5-amino-4-hydroxy-, tetrasodium salt	72-57-1	Contains (regardless of intentional or impurities)	chemical products
2143	Adenine	73-24-5	Contains (regardless of intentional or impurities)	chemical products
2144	N,N'-Diphenyl-p-phenylenediamine	74-31-7	Contains (regardless of intentional or impurities)	chemical products
2145	Bromomethane	74-83-9	Contains (regardless of intentional or impurities)	chemical products
2146	Ethene	74-85-1	Contains (regardless of intentional or impurities)	chemical products
2147	Methyl chloride	74-87-3	Contains (regardless of intentional or impurities)	chemical products
2148	Iodomethane	74-88-4	Contains (regardless of intentional or impurities)	chemical products
2149	Methylamine	74-89-5	Contains (regardless of intentional or impurities)	chemical products
2150	Hydrogen cyanide	74-90-8	Contains (regardless of intentional or impurities)	chemical products
2151	Methanethiol	74-93-1	Contains (regardless of intentional or impurities)	chemical products
2152	Boron, trihydro(N-methylmethanamine)-, (T-4)-	74-94-2	Intentional addition / 1%	chemical products
2153	Methane, dibromo-	74-95-3	Contains (regardless of intentional or impurities)	chemical products
2154	Ethyl bromide	74-96-4	Contains (regardless of intentional or impurities)	chemical products
2155	Chlorobromomethane	74-97-5	Contains (regardless of intentional or impurities)	chemical products
2156	Methylacetylene	74-99-7	Contains (regardless of intentional or impurities)	chemical products
2157	Ethyl chloride	75-00-3	Contains (regardless of intentional or impurities)	chemical products
2158	Vinyl chloride	75-01-4	Contains (regardless of intentional or impurities)	chemical products
2159	Vinyl fluoride	75-02-5	Contains (regardless of intentional or impurities)	chemical products
2160	Iodoethane	75-03-6	Contains (regardless of intentional or impurities)	chemical products
2161	Ethylamine	75-04-7	Contains (regardless of intentional or impurities)	chemical products
2162	Acetonitrile	75-05-8	Contains (regardless of intentional or impurities)	chemical products
2163	Acetaldehyde	75-07-0	Contains (regardless of intentional or impurities)	chemical products
2164	Ethanethiol	75-08-1	Contains (regardless of intentional or impurities)	chemical products
2165	Dichloromethane	75-09-2	Contains (regardless of intentional or impurities)	chemical products
2166	Difluoromethane	75-10-5	Contains (regardless of intentional or impurities)	chemical products
2167	Carbon disulfide	75-15-0	Contains (regardless of intentional or impurities)	chemical products
2168	Dimethyl sulfide	75-18-3	Contains (regardless of intentional or impurities)	chemical products
2169	Ethylene oxide	75-21-8	Contains (regardless of intentional or impurities)	chemical products
2170	Boron, (N,N-dimethylmethanamine)trihydro-, (T-4)-	75-22-9	Intentional addition / 1%	chemical products
2171	Boron, (ethanamine)trifluoro-, (T-4)-	75-23-0	Contains (regardless of intentional or impurities)	chemical products
2172	Trimethylaluminum	75-24-1	Contains (regardless of intentional or impurities)	chemical products
2173	Bromoform	75-25-2	Contains (regardless of intentional or impurities)	chemical products
2174	2-Bromopropane	75-26-3	Contains (regardless of intentional or impurities)	chemical products
2175	Dichlorobromomethane	75-27-4	Contains (regardless of intentional or impurities)	chemical products
2176	Isobutane	75-28-5	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
2177	2-Chloropropane	75-29-6	Contains (regardless of intentional or impurities)	chemical products
2178	2-Iodopropane	75-30-9	Contains (regardless of intentional or impurities)	chemical products
2179	Isopropylamine	75-31-0	Contains (regardless of intentional or impurities)	chemical products
2180	1,1-Dichloroethane	75-34-3	Contains (regardless of intentional or impurities)	chemical products
2181	1,1-Dichloroethene	75-35-4	Contains (regardless of intentional or impurities)	chemical products
2182	1,1-Difluoroethane	75-37-6	Contains (regardless of intentional or impurities)	chemical products
2183	Ethene, 1,1-difluoro-	75-38-7	Contains (regardless of intentional or impurities)	chemical products
2184	Dichlorodifluoromethane	75-43-4	Contains (regardless of intentional or impurities)	chemical products
2185	Phosgene	75-44-5	Contains (regardless of intentional or impurities)	chemical products
2186	Chlorodifluoromethane	75-45-6	Contains (regardless of intentional or impurities)	chemical products
2187	Trifluoromethane	75-46-7	Contains (regardless of intentional or impurities)	chemical products
2188	Iodoform	75-47-8	Contains (regardless of intentional or impurities)	chemical products
2189	Trimethylamine	75-50-3	Contains (regardless of intentional or impurities)	chemical products
2190	Nitromethane	75-52-5	Contains (regardless of intentional or impurities)	chemical products
2191	Azirdine, 2-methyl-	75-55-8	Contains (regardless of intentional or impurities)	chemical products
2192	Tetramethylammonium hydroxide	75-59-2	Contains (regardless of intentional or impurities)	chemical products
2193	Arsinic acid, dimethyl-	75-60-5	Contains (regardless of intentional or impurities)	chemical products
2194	Difluorodibromomethane	75-61-6	Contains (regardless of intentional or impurities)	chemical products
2195	Methane, bromotrichloro-	75-62-7	Intentional addition / 1,000ppm	chemical products
2196	Methane, bromotrifluoro-	75-63-8	Contains (regardless of intentional or impurities)	chemical products
2197	tert-Butyl alcohol	75-65-0	Contains (regardless of intentional or impurities)	chemical products
2198	1-Chloro-1,1-difluoroethane	75-68-3	Contains (regardless of intentional or impurities)	chemical products
2199	Trichlorofluoromethane	75-69-4	Contains (regardless of intentional or impurities)	chemical products
2200	Dichlorodifluoromethane	75-71-8	Contains (regardless of intentional or impurities)	chemical products
2201	Chlorotrifluoromethane	75-72-9	Contains (regardless of intentional or impurities)	chemical products
2202	Tetrafluoromethane	75-73-0	Contains (regardless of intentional or impurities)	chemical products
2203	Methanesulfonic acid	75-75-2	Contains (regardless of intentional or impurities)	chemical products
2204	Ethane, 1,2-dibromo-1,1-dichloro-	75-81-0	Intentional addition / 1,000ppm	chemical products
2205	1,2-Dibromo-1,1-difluoroethane	75-82-1	Contains (regardless of intentional or impurities)	chemical products
2206	Neohexane	75-83-2	Contains (regardless of intentional or impurities)	chemical products
2207	Acetone cyanohydrin	75-86-5	Contains (regardless of intentional or impurities)	chemical products
2208	2-Chloro-1,1,1-trifluoroethane	75-88-7	Contains (regardless of intentional or impurities)	chemical products
2209	tert-Butyl hydroperoxide	75-91-2	Contains (regardless of intentional or impurities)	chemical products
2210	Pentabromoethane	75-95-6	Intentional addition / 1,000ppm	chemical products
2211	2,2-Dichloropropionic acid	75-99-0	Contains (regardless of intentional or impurities)	chemical products
2212	Pentachloroethane	76-01-7	Contains (regardless of intentional or impurities)	chemical products
2213	Trichloroacetic acid	76-03-9	Contains (regardless of intentional or impurities)	chemical products
2214	Chloropicrin	76-06-2	Contains (regardless of intentional or impurities)	chemical products
2215	1,1,1,2-Tetrachloro-2,2-difluoroethane	76-11-9	Contains (regardless of intentional or impurities)	chemical products
2216	1,1,2,2-Tetrachloro-1,2-difluoroethane	76-12-0	Contains (regardless of intentional or impurities)	chemical products
2217	1,1,2-Trichloro-1,2,2-trifluoroethane	76-13-1	Contains (regardless of intentional or impurities)	chemical products
2218	1,2-Dichlorotetrafluoroethane	76-14-2	Contains (regardless of intentional or impurities)	chemical products
2219	Chloropentafluoroethane	76-15-3	Contains (regardless of intentional or impurities)	chemical products
2220	Hexafluoroethane	76-16-4	Contains (regardless of intentional or impurities)	chemical products
2221	Propane, 1,2,3-trichloro-1,1,2,3,3-pentafluoro-	76-17-5	Intentional addition / 1,000ppm	chemical products
2222	2-Chloro-1,1,1,2,3,3,3-heptafluoropropane	76-18-6	Intentional addition	chemical products
2223	Octafluoropropane	76-19-7	Contains (regardless of intentional or impurities)	chemical products
2224	2,2-Bis(ethylsulphonyl)butane	76-20-0	Intentional addition / 100%	chemical products
2225	Camphor	76-22-2	Contains (regardless of intentional or impurities)	chemical products
2226	Allyltriphenylstannane	76-63-1	Contains (regardless of intentional or impurities)	chemical products
2227	Hexachlorocyclopentadiene	77-47-4	Contains (regardless of intentional or impurities)	chemical products
2228	1-Phenylcyclohexanecarbonitrile	77-57-6	Intentional addition	chemical products
2229	Dibutyltin dilaurate	77-58-6	Contains (regardless of intentional or impurities)	chemical products
2230	Cyclopentadiene	77-73-6	Contains (regardless of intentional or impurities)	chemical products
2231	Divinyl sulphone	77-77-0	Contains (regardless of intentional or impurities)	chemical products
2232	Hexaphenylidistannathiane	77-80-5	Contains (regardless of intentional or impurities)	chemical products
2233	Dibutyltin maleate	78-04-6	Contains (regardless of intentional or impurities)	chemical products
2234	6H-1,3,2-Oxathiazin-6-one, 2,2-dihydro-	78-06-8	Contains (regardless of intentional or impurities)	chemical products
2235	Silicic acid (H4SiO4), tetraethyl ester	78-10-4	Contains (regardless of intentional or impurities)	chemical products
2236	1,3,2-Oxathiazinolan-5-one, 2,2-dibutyl-	78-20-6	Contains (regardless of intentional or impurities)	chemical products
2237	Tri- <i>o</i> -cresyl phosphate	78-30-8	Contains (regardless of intentional or impurities)	chemical products
2238	Phosphoric acid, tris(4-methylphenyl) ester	78-32-0	Contains (regardless of intentional or impurities)	chemical products
2239	dioxathion	78-34-2	Contains (regardless of intentional or impurities)	chemical products
2240	Tris(2-ethylhexyl) phosphate	78-42-2	Intentional addition / 1%	chemical products
2241	S,S,S-Tributyl phosphorotriothoate	78-48-8	Contains (regardless of intentional or impurities)	chemical products
2242	Isophorone	78-59-1	Contains (regardless of intentional or impurities)	chemical products
2243	Propanenitrile, 2,2'-azobis[2-methyl-	78-67-1	Contains (regardless of intentional or impurities)	chemical products
2244	Ethane, 1,1,2-tribromo-	78-74-0	Intentional addition / 1,000ppm	chemical products
2245	1,2-Dibromopropane	78-75-1	Contains (regardless of intentional or impurities)	chemical products
2246	2-Bromobutane	78-76-2	Contains (regardless of intentional or impurities)	chemical products
2247	1-Bromo-2-methylpropane	78-77-3	Contains (regardless of intentional or impurities)	chemical products
2248	Isopentane	78-78-4	Contains (regardless of intentional or impurities)	chemical products
2249	1,3-Butadiene, 2-methyl-	78-79-5	Contains (regardless of intentional or impurities)	chemical products
2250	Isobutyronitrile	78-82-0	Contains (regardless of intentional or impurities)	chemical products
2251	Isobutyl alcohol	78-83-1	Contains (regardless of intentional or impurities)	chemical products
2252	Isobutyraldehyde	78-84-2	Contains (regardless of intentional or impurities)	chemical products
2253	Butane, 2-chloro-	78-86-4	Contains (regardless of intentional or impurities)	chemical products
2254	1,2-Dichloropropane	78-87-5	Contains (regardless of intentional or impurities)	chemical products
2255	2,3-Dichloropropene	78-88-6	Contains (regardless of intentional or impurities)	chemical products
2256	2-Chloro-1-propanol	78-89-7	Contains (regardless of intentional or impurities)	chemical products
2257	2-Butanol	78-92-2	Contains (regardless of intentional or impurities)	chemical products
2258	Methyl ethyl ketone	78-93-3	Contains (regardless of intentional or impurities)	chemical products
2259	Methyl vinyl ketone	78-94-4	Contains (regardless of intentional or impurities)	chemical products
2260	2-Propanone, 1-chloro-	78-95-5	Contains (regardless of intentional or impurities)	chemical products
2261	Isopropanolamine	78-96-6	Contains (regardless of intentional or impurities)	chemical products
2262	Propanenitrile, 2-hydroxy-	78-97-7	Contains (regardless of intentional or impurities)	chemical products
2263	1,1-Dichloropropane	78-99-9	Intentional addition / 1,000ppm	chemical products
2264	1,1,2-Trichloroethane	79-00-5	Contains (regardless of intentional or impurities)	chemical products
2265	Chloroacetyl chloride	79-04-9	Contains (regardless of intentional or impurities)	chemical products
2266	2-Chloroacetamide	79-07-2	Contains (regardless of intentional or impurities)	chemical products
2267	Bromoacetic acid	79-08-3	Contains (regardless of intentional or impurities)	chemical products
2268	Propanoic acid	79-09-4	Contains (regardless of intentional or impurities)	chemical products
2269	Acrylic acid	79-10-7	Contains (regardless of intentional or impurities)	chemical products
2270	Chloroacetic acid	79-11-8	Contains (regardless of intentional or impurities)	chemical products
2271	Acetic acid, 2-hydroxy-	79-14-1	Intentional addition	chemical products
2272	Thiosemicarbazide	79-19-6	Contains (regardless of intentional or impurities)	chemical products
2273	Methyl acetate	79-20-9	Contains (regardless of intentional or impurities)	chemical products
2274	Nitroethane	79-24-3	Contains (regardless of intentional or impurities)	chemical products
2275	1,1,2,2-Tetrabromoethane	79-27-6	Contains (regardless of intentional or impurities)	chemical products
2276	Ethene, tetrabromo-	79-28-7	Intentional addition / 1,000ppm	chemical products
2277	2,3-Dimethylbutane	79-29-9	Contains (regardless of intentional or impurities)	chemical products
2278	L-Lactic acid	79-33-4	Intentional addition / 1,000ppm	chemical products
2279	1,1,2,2-Tetrachloroethane	79-34-5	Contains (regardless of intentional or impurities)	chemical products
2280	Ethene, chlorotrifluoro-	79-38-9	Contains (regardless of intentional or impurities)	chemical products
2281	Methacrylic acid	79-41-4	Contains (regardless of intentional or impurities)	chemical products
2282	Dichloroacetic acid	79-43-6	Contains (regardless of intentional or impurities)	chemical products
2283	Dimethylcarbamoyl chloride	79-44-7	Contains (regardless of intentional or impurities)	chemical products
2284	2-Nitropropane	79-46-9	Contains (regardless of intentional or impurities)	chemical products
2285	1,4-Benzenediol, 2,5-bis(1,1-dimethylpropyl)-	79-74-3	Intentional addition / 1,000ppm	chemical products
2286	2,2',6,6'-Tetrabromobisphenol A	79-94-7	Contains (regardless of intentional or impurities)	chemical products
2287	Cumene hydroperoxide	80-15-9	Contains (regardless of intentional or impurities)	chemical products
2288	Peroxide, bis(1-methyl-1-phenylethyl)	80-43-3	Contains (regardless of intentional or impurities)	chemical products
2289	Benzenesulfonic acid, 4-methyl-, methyl ester	80-48-8	Contains (regardless of intentional or impurities)	chemical products
2290	Benzenesulfonic acid, 4-oxobis-, dihydrazide	80-51-3	Contains (regardless of intentional or impurities)	chemical products
2291	Methyl methacrylate	80-62-6	Contains (regardless of intentional or impurities)	chemical products
2292	9,10-Anthracenedione, 1-amino-4-bromo-2-methyl-	81-50-5	Contains (regardless of intentional or impurities)	chemical products
2293	9,10-Anthracenedione, 1,8-dihydroxy-4,5-dinitro-	81-55-0	Contains (regardless of intentional or impurities)	chemical products
2294	1,4-Dihydroxy-9,10-anthracenedione	81-64-1	Contains (regardless of intentional or impurities)	chemical products
2295	warfarin	81-81-2	Contains (regardless of intentional or impurities)	chemical products
2296	1-Aminoanthraquinone	82-45-1	Intentional addition / 1%	chemical products
2297	Diphacine	82-66-6	Contains (regardless of intentional or impurities)	chemical products
2298	Pentachloronitrobenzene	82-68-8	Contains (regardless of intentional or impurities)	chemical products
2299	Pindone	83-26-1	Contains (regardless of intentional or impurities)	chemical products
2300	Acenaphthene	83-32-9	Contains (regardless of intentional or impurities)	chemical products
2301	Rotenone	83-79-4	Contains (regardless of intentional or impurities)	chemical products
2302	<i>o</i> -Terphenyl	84-15-1	Intentional addition / 1,000ppm	chemical products
2303	1,4-Cyclohexadiene-1,2-dicarbonitrile, 4,5-dichloro-3,6-dioxo-	84-58-2	Contains (regardless of intentional or impurities)	chemical products
2304	Anthraquinone	84-65-1	Contains (regardless of intentional or impurities)	chemical products
2305	Diethyl phthalate	84-66-2	Contains (regardless of intentional or impurities)	chemical products
2306	2,2'-Dichloro[1,1'-biphenyl]-4,4'-diamine	84-68-4	Intentional addition / 1%	chemical products
2307	Diquat dibromide	85-00-7	Contains (regardless of intentional or impurities)	chemical products
2308	Benzoflquinoline	85-02-9	Contains (regardless of intentional or impurities)	chemical products
2309	1,2,3,6-Tetrahydrophthalic anhydride	85-43-8	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
2310	Phthalic anhydride	85-44-9	Contains (regardless of intentional or impurities)	chemical products
2311	2-Naphthalenol, 1-[[2-methyl-4-[(2-methylphenylazo)phenyl]azo]-	85-83-6	Intentional addition / 1,000ppm	chemical products
2312	C.I. Solvent Red 23	85-86-9	Intentional addition / 1,000ppm	chemical products
2313	Benzeneacetone, alpha-phenyl-	86-29-3	Contains (regardless of intentional or impurities)	chemical products
2314	Diphenylnitrosamine	86-30-6	Contains (regardless of intentional or impurities)	chemical products
2315	Azinphos-methyl	86-50-0	Contains (regardless of intentional or impurities)	chemical products
2316	1-Naphthalene-carbonitrile	86-53-3	Contains (regardless of intentional or impurities)	chemical products
2317	8-Quinolinyboronic acid	86-58-8	Intentional addition / 1%	chemical products
2318	Dibenzofuran, 2-bromo-	86-76-0	Intentional addition / 100ppm	chemical products
2319	1-(1-Naphthyl)-2-thiourea	86-88-4	Contains (regardless of intentional or impurities)	chemical products
2320	7-Amino-4-hydroxy-2-naphthalenesulfonic acid	87-09-5	Contains (regardless of intentional or impurities)	chemical products
2321	Benzenamine, 2,3-dimethyl-	87-56-2	Contains (regardless of intentional or impurities)	chemical products
2322	1,2,3-Trichlorobenzene	87-61-6	Contains (regardless of intentional or impurities)	chemical products
2323	Benzenamine, 2,6-dimethyl-	87-62-7	Contains (regardless of intentional or impurities)	chemical products
2324	1,2,3-Benzene-triol	87-66-1	Contains (regardless of intentional or impurities)	chemical products
2325	Benzene, pentabromomethyl-	87-83-2	Intentional addition / 900ppm	chemical products
2326	Symclosene	87-90-1	Contains (regardless of intentional or impurities)	chemical products
2327	Aniline, 2,4,6-trimethyl-	88-05-1	Contains (regardless of intentional or impurities)	chemical products
2328	2,4,6-Trichlorophenol	88-06-2	Contains (regardless of intentional or impurities)	chemical products
2329	N-Vinyl-2-pyrrolidone	88-12-0	Contains (regardless of intentional or impurities)	chemical products
2330	Phenol, 2-(1,1-dimethylethyl)-	88-18-6	Contains (regardless of intentional or impurities)	chemical products
2331	Phenol, 3-(1,1-dimethylethyl)-4-methoxy-	88-32-4	Intentional addition / 1%	chemical products
2332	Phenol, 2-(1,1-dimethylethyl)-5-methyl-	88-60-8	Intentional addition / 1%	chemical products
2333	2-Nitrotoluene	88-72-2	Contains (regardless of intentional or impurities)	chemical products
2334	Benzene, 1-chloro-2-nitro-	88-73-3	Contains (regardless of intentional or impurities)	chemical products
2335	Benzenamine, 2-nitro-	88-74-4	Contains (regardless of intentional or impurities)	chemical products
2336	Phenol, 2,4,6-trinitro-	88-89-1	Contains (regardless of intentional or impurities)	chemical products
2337	Benzene, 1,4-dichloro-2-nitro-	89-61-2	Contains (regardless of intentional or impurities)	chemical products
2338	Benzenamine, 4-chloro-2-nitro-	89-63-4	Contains (regardless of intentional or impurities)	chemical products
2339	Phenol, 2-(1-methylpropyl)-	89-72-5	Intentional addition / 1%	chemical products
2340	Salicylaldehyde	90-02-8	Contains (regardless of intentional or impurities)	chemical products
2341	1-Methylnaphthalene	90-12-0	Contains (regardless of intentional or impurities)	chemical products
2342	1-Chloronaphthalene	90-13-1	Contains (regardless of intentional or impurities)	chemical products
2343	1-Naphthalenamine, N-phenyl-	90-30-2	1,000ppm	chemical products
2344	2-Phenylphenol	90-43-7	Contains (regardless of intentional or impurities)	chemical products
2345	Toluene 2,6-diisocyanate	91-08-7	Contains (regardless of intentional or impurities)	chemical products
2346	1,2-Divinylbenzene	91-14-5	1,000ppm	chemical products
2347	o-Phthalodinitrile	91-15-6	Intentional addition / 1%	chemical products
2348	Naphthalene	91-20-3	Contains (regardless of intentional or impurities)	chemical products
2349	Quinoline	91-22-5	Contains (regardless of intentional or impurities)	chemical products
2350	Benzene, 1-methoxy-2-nitro-	91-23-6	Contains (regardless of intentional or impurities)	chemical products
2351	2-Methylnaphthalene	91-57-6	Contains (regardless of intentional or impurities)	chemical products
2352	1-Chloronaphthalene	91-58-7	Contains (regardless of intentional or impurities)	chemical products
2353	2-Naphthylamine	91-59-8	Contains (regardless of intentional or impurities)	chemical products
2354	Phenol, 3-(diethylamino)-	91-68-9	Contains (regardless of intentional or impurities)	chemical products
2355	[1,1-Biphenyl]-4,4-bis(diazonium), 3,3'-dimethoxy-, dichloride	91-81-8	Intentional addition / 30ppm	chemical products
2356	3,3'-Dimethoxybenzidine-4,4'-diisocyanate	91-93-0	Intentional addition / 30ppm	chemical products
2357	3,3'-Dichlorobenzidine	91-94-1	Contains (regardless of intentional or impurities)	chemical products
2358	3,3'-Diaminobenzidine	91-95-2	Contains (regardless of intentional or impurities)	chemical products
2359	1,1'-Biphenyl, 4,4'-diisocyanato-3,3'-dimethyl-	91-97-4	Contains (regardless of intentional or impurities)	chemical products
2360	m-Terphenyl	92-06-8	1,000ppm	chemical products
2361	Benzenamine, 4-(6-methyl-2-benzothiazolyl)-	92-36-4	Contains (regardless of intentional or impurities)	chemical products
2362	Biphenyl	92-52-4	Contains (regardless of intentional or impurities)	chemical products
2363	Propanenitrile, 3-[[2-hydroxyethyl]phenylamino]-	92-64-0	Intentional addition	chemical products
2364	4-Bromodiphenyl	92-66-0	Contains (regardless of intentional or impurities)	chemical products
2365	2-Naphthalene-carboxylic acid, 3-hydroxy-	92-70-6	Contains (regardless of intentional or impurities)	chemical products
2366	Phenothiazine	92-84-2	1%	chemical products
2367	[1,1'-Biphenyl]-4,4'-diamine	92-87-5	Contains (regardless of intentional or impurities)	chemical products
2368	4-Nitrobiphenyl	92-93-3	Contains (regardless of intentional or impurities)	chemical products
2369	p-Terphenyl	92-94-4	1,000ppm	chemical products
2370	3,4-Dimethoxyphenylacetone	93-17-4	Contains (regardless of intentional or impurities)	chemical products
2371	Mecrop	93-65-2	Intentional addition / 1,000ppm	chemical products
2372	2,4,5-Trichlorophenoxyacetic acid	93-76-5	Contains (regardless of intentional or impurities)	chemical products
2373	2,4,5-(Trichlorophenoxy) acetic acid-isopropyl ester	93-78-7	Intentional addition / 1,000ppm	chemical products
2374	Acetic acid, (2,4,5-trichlorophenoxy)-, butyl ester	93-79-8	Intentional addition / 1,000ppm	chemical products
2375	2-Propanoic acid, 2-cyano-3-ethoxy-, ethyl ester	94-05-3	Intentional addition	chemical products
2376	Propanenitrile, 3-[[4-formylphenyl]methylamino]-	94-21-3	Intentional addition	chemical products
2377	Propanenitrile, 3-(methylphenylamino)-	94-34-8	Intentional addition	chemical products
2378	Dibenzoyl peroxide	94-36-0	Contains (regardless of intentional or impurities)	chemical products
2379	6-Ethoxybenzothiazol-2-ylamine	94-45-1	Contains (regardless of intentional or impurities)	chemical products
2380	Safrole	94-59-7	Contains (regardless of intentional or impurities)	chemical products
2381	N-Ethyl-o-toluidine	94-68-8	Intentional addition / 25%	chemical products
2382	Acetic acid, (4-chloro-2-methylphenoxy)-	94-74-6	Contains (regardless of intentional or impurities)	chemical products
2383	2,4-Dichlorophenoxyacetic acid	94-75-7	Contains (regardless of intentional or impurities)	chemical products
2384	Sulfalate	95-06-7	Contains (regardless of intentional or impurities)	chemical products
2385	Bicyclo[2.2.1]hept-5-ene-2-carbonitrile	95-11-4	Intentional addition	chemical products
2386	Indene	95-13-6	Intentional addition / 1%	chemical products
2387	N-tert-Butyl-2-benzothiazolesulfenamide	95-31-8	1%	chemical products
2388	2-(4-Morpholinyldithio)-benzothiazole	95-32-9	1%	chemical products
2389	o-Bromotoluene	95-46-5	Contains (regardless of intentional or impurities)	chemical products
2390	o-Xylene	95-47-6	Contains (regardless of intentional or impurities)	chemical products
2391	o-Cresol	95-48-7	Contains (regardless of intentional or impurities)	chemical products
2392	o-Chlorotoluene	95-49-8	Contains (regardless of intentional or impurities)	chemical products
2393	o-Dichlorobenzene	95-50-1	Contains (regardless of intentional or impurities)	chemical products
2394	2-Chloroaniline	95-51-2	Contains (regardless of intentional or impurities)	chemical products
2395	1,2-Benzenediamine	95-54-5	Contains (regardless of intentional or impurities)	chemical products
2396	2-Aminophenol	95-55-6	Contains (regardless of intentional or impurities)	chemical products
2397	2-Chlorophenol	95-57-8	Contains (regardless of intentional or impurities)	chemical products
2398	Benzene, 1,2,4-trimethyl-	95-63-6	Contains (regardless of intentional or impurities)	chemical products
2399	3,4-Xylidine	95-64-7	Contains (regardless of intentional or impurities)	chemical products
2400	Benzenamine, 2,4-dimethyl-	95-68-1	Contains (regardless of intentional or impurities)	chemical products
2401	Benzenamine, 4-chloro-2-methyl-	95-69-2	Contains (regardless of intentional or impurities)	chemical products
2402	1,4-Benzenediamine, 2-methyl-	95-70-5	Contains (regardless of intentional or impurities)	chemical products
2403	2,4-Dichlorotoluene	95-73-8	Contains (regardless of intentional or impurities)	chemical products
2404	3,4-Dichloroaniline	95-76-1	Contains (regardless of intentional or impurities)	chemical products
2405	2,5-Xylidine	95-78-3	Contains (regardless of intentional or impurities)	chemical products
2406	Benzenamine, 2,5-dichloro-	95-82-9	Contains (regardless of intentional or impurities)	chemical products
2407	1,2-Benzenediamine, 4-chloro-	95-83-0	Contains (regardless of intentional or impurities)	chemical products
2408	2-Amino-4-chlorophenol	95-85-2	Contains (regardless of intentional or impurities)	chemical products
2409	1,2,4,5-Tetrachlorobenzene	95-94-3	Contains (regardless of intentional or impurities)	chemical products
2410	2,4,5-Trichlorophenol	95-95-4	Contains (regardless of intentional or impurities)	chemical products
2411	Oxirane, phenyl-	96-09-3	Contains (regardless of intentional or impurities)	chemical products
2412	Diethylaluminum chloride	96-10-6	Contains (regardless of intentional or impurities)	chemical products
2413	Propane, 1,2,3-tribromo-	96-11-7	1,000ppm	chemical products
2414	1,2-Dibromo-3-chloropropane	96-12-8	Contains (regardless of intentional or impurities)	chemical products
2415	3-Methylpentane	96-14-0	Contains (regardless of intentional or impurities)	chemical products
2416	1-Propene, 1,2,3-trichloro-	96-19-5	1,000ppm	chemical products
2417	2-Propanol, 1,3-dibromo-	96-21-9	Contains (regardless of intentional or impurities)	chemical products
2418	Diethyl ketone	96-22-0	Contains (regardless of intentional or impurities)	chemical products
2419	1,3-Dichloro-2-propanol	96-23-1	Contains (regardless of intentional or impurities)	chemical products
2420	1,2-Propanediol, 3-chloro-	96-24-2	Contains (regardless of intentional or impurities)	chemical products
2421	Methyl bromoacetate	96-32-2	Contains (regardless of intentional or impurities)	chemical products
2422	Methyl acrylate	96-33-3	Contains (regardless of intentional or impurities)	chemical products
2423	Methyl chloroacetate	96-34-4	Contains (regardless of intentional or impurities)	chemical products
2424	4,4'-Thiobis(6-tert-butyl-m-cresol)	96-69-5	Contains (regardless of intentional or impurities)	chemical products
2425	Phenol, 2,4-bis(1,1-dimethylethyl)-	96-76-4	1,000ppm	chemical products
2426	Benzoic acid, 4-chloro-3-nitro-	96-99-1	Contains (regardless of intentional or impurities)	chemical products
2427	1-Chloro-2,4-dinitrobenzene	97-00-7	Contains (regardless of intentional or impurities)	chemical products
2428	2,4-Dinitroaniline	97-02-9	Contains (regardless of intentional or impurities)	chemical products
2429	Dichlofenthion	97-17-6	Contains (regardless of intentional or impurities)	chemical products
2430	Dichlorophen	97-23-4	Contains (regardless of intentional or impurities)	chemical products
2431	4-(4-Amino-2-methylbenzyl)-3-methylbenzenamine	97-28-9	Contains (regardless of intentional or impurities)	chemical products
2432	1,3-Di-o-tolylguanidine	97-39-2	1,000ppm	chemical products
2433	Acetarsol	97-44-9	Contains (regardless of intentional or impurities)	chemical products
2434	Benzenamine, 2-methoxy-4-nitro-	97-52-9	Contains (regardless of intentional or impurities)	chemical products
2435	Butanedioic acid, methylene-	97-65-4	Intentional addition	chemical products
2436	Disulfiram	97-77-8	Contains (regardless of intentional or impurities)	chemical products
2437	Butyl methacrylate	97-88-1	Contains (regardless of intentional or impurities)	chemical products
2438	Triethylaluminum	97-93-8	Contains (regardless of intentional or impurities)	chemical products
2439	Triethylborane	97-94-9	Contains (regardless of intentional or impurities)	chemical products
2440	Tetrahydrofurfuryl alcohol	97-99-4	Contains (regardless of intentional or impurities)	chemical products
2441	Furfuryl alcohol	98-00-0	Contains (regardless of intentional or impurities)	chemical products
2442	Furfural	98-01-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
2443	Benzenearsonic acid	98-05-5	Contains (regardless of intentional or impurities)	chemical products
2444	Benzene, (trichloromethyl)-	98-07-7	Contains (regardless of intentional or impurities)	chemical products
2445	Benzenesulfonyl chloride	98-09-9	Contains (regardless of intentional or impurities)	chemical products
2446	Phenyltrichlorosilane	98-13-5	Contains (regardless of intentional or impurities)	chemical products
2447	4-Hydroxyphenylarsonic acid	98-14-6	Contains (regardless of intentional or impurities)	chemical products
2448	Arsonic acid, (4-aminophenyl)-	98-50-0	Contains (regardless of intentional or impurities)	chemical products
2449	p-tert-Butyltoluene	98-51-1	Contains (regardless of intentional or impurities)	chemical products
2450	Benzene, 1-chloro-4-(trifluoromethyl)-	98-56-6	Contains (regardless of intentional or impurities)	chemical products
2451	Nitarsone	98-72-6	Contains (regardless of intentional or impurities)	chemical products
2452	4-tert-Butylbenzoic acid	98-73-7	Contains (regardless of intentional or impurities)	chemical products
2453	Boronic acid, phenyl-	98-80-6	1%	chemical products
2454	Isopropylbenzene	98-82-8	Contains (regardless of intentional or impurities)	chemical products
2455	alpha-Methylstyrene	98-83-9	Contains (regardless of intentional or impurities)	chemical products
2456	Acetophenone	98-86-2	Contains (regardless of intentional or impurities)	chemical products
2457	alpha, alpha-Dichlorotoluene	98-87-3	Contains (regardless of intentional or impurities)	chemical products
2458	Benzoyl chloride	98-88-4	Contains (regardless of intentional or impurities)	chemical products
2459	N,N-Dimethylcyclohexylamine	98-94-2	Contains (regardless of intentional or impurities)	chemical products
2460	m-Nitrotoluene	99-08-1	Contains (regardless of intentional or impurities)	chemical products
2461	Benzenamine, 3-nitro-	99-09-2	Contains (regardless of intentional or impurities)	chemical products
2462	(R)-[(beta-D-Glucopyranosyloxy)phenyl]acetone	99-18-3	Intentional addition	chemical products
2463	Benzoyl chloride, 3,5-dinitro-	99-33-2	Contains (regardless of intentional or impurities)	chemical products
2464	Benzoic acid, 3,5-dinitro-	99-34-3	Contains (regardless of intentional or impurities)	chemical products
2465	Benzenamine, 2-methyl-4-nitro-	99-52-5	Contains (regardless of intentional or impurities)	chemical products
2466	3,4-Dichloronitrobenzene	99-54-7	Contains (regardless of intentional or impurities)	chemical products
2467	Benzenamine, 2-methyl-5-nitro-	99-55-8	Contains (regardless of intentional or impurities)	chemical products
2468	1,3-Dinitrobenzene	99-65-0	Contains (regardless of intentional or impurities)	chemical products
2469	Benzoic acid, 4-hydroxy-, methyl ester	99-76-3	1%	chemical products
2470	p-Cymene	99-87-6	Contains (regardless of intentional or impurities)	chemical products
2471	1,4-Benzenediamine, N,N-dimethyl-	99-98-9	Contains (regardless of intentional or impurities)	chemical products
2472	p-Nitrotoluene	99-99-0	Contains (regardless of intentional or impurities)	chemical products
2473	Benzene, 1-chloro-4-nitro-	100-00-5	Contains (regardless of intentional or impurities)	chemical products
2474	Benzenamine, 4-nitro-	100-01-6	Contains (regardless of intentional or impurities)	chemical products
2475	Benzene, 1-methoxy-4-nitro-	100-17-4	Contains (regardless of intentional or impurities)	chemical products
2476	1,4-Benzenedicarbonyl dichloride	100-20-9	Contains (regardless of intentional or impurities)	chemical products
2477	1,4-Benzenedicarboxylic acid	100-21-0	Intentional addition / 1%	chemical products
2478	Benzene, 1,4-dinitro-	100-25-4	Contains (regardless of intentional or impurities)	chemical products
2479	Ethanol, 2-(diethylamino)-	100-37-8	Contains (regardless of intentional or impurities)	chemical products
2480	Benzyl bromide	100-39-0	Contains (regardless of intentional or impurities)	chemical products
2481	4-Vinylcyclohexene	100-40-3	Contains (regardless of intentional or impurities)	chemical products
2482	Ethylbenzene	100-41-4	Contains (regardless of intentional or impurities)	chemical products
2483	Styrene	100-42-5	Contains (regardless of intentional or impurities)	chemical products
2484	Benzene, (chloromethyl)-	100-44-7	Contains (regardless of intentional or impurities)	chemical products
2485	3-Cyclohexene-1-carbonitrile	100-45-8	Contains (regardless of intentional or impurities)	chemical products
2486	Benzonitrile	100-47-0	Contains (regardless of intentional or impurities)	chemical products
2487	4-Pyridinecarbonitrile	100-48-1	Contains (regardless of intentional or impurities)	chemical products
2488	Benzaldehyde	100-52-7	Contains (regardless of intentional or impurities)	chemical products
2489	N-Methylaniline	100-61-8	Contains (regardless of intentional or impurities)	chemical products
2490	Phenylhydrazine	100-63-0	Contains (regardless of intentional or impurities)	chemical products
2491	2-Vinylpyridine	100-69-6	Contains (regardless of intentional or impurities)	chemical products
2492	2-Pyridinecarbonitrile	100-70-9	Contains (regardless of intentional or impurities)	chemical products
2493	N-Ethylmorpholine	100-74-3	Contains (regardless of intentional or impurities)	chemical products
2494	N-Nitrosopiperidine	100-75-4	Contains (regardless of intentional or impurities)	chemical products
2495	Benzene, 1-ethyl-3-methyl-	100-80-1	1%	chemical products
2496	1,3,5,7-Tetraazabicyclo[3.3.1]nonane	100-89-0	1%	chemical products
2497	1,3,5,7-Tetraazabicyclo[3.3.1]nonane	100-91-0	Contains (regardless of intentional or impurities)	chemical products
2498	Aluminum, tris(2-methylpropyl)-	100-99-2	Contains (regardless of intentional or impurities)	chemical products
2499	1,2,5,7-Tetraazabicyclo[3.3.1]nonane, 3,7-dinitroso-	101-25-7	Contains (regardless of intentional or impurities)	chemical products
2500	Boroxin, tributoxy	101-36-0	1%	chemical products
2501	1,3,5-Triazine, 2,4,6-tris(2-propenyl)-	101-37-1	Contains (regardless of intentional or impurities)	chemical products
2502	Benzene, 1-bromo-4-phenoxy-	101-55-3	Contains (regardless of intentional or impurities)	chemical products
2503	Benzene, 1,1'-oxybis[4-nitro-	101-63-3	Contains (regardless of intentional or impurities)	chemical products
2504	4,4'-Methylenediphenyl diisocyanate	101-68-8	Contains (regardless of intentional or impurities)	chemical products
2505	N-Isopropyl-N-phenyl-p-phenylenediamine	101-72-4	Contains (regardless of intentional or impurities)	chemical products
2506	Dicyclohexylamine	101-83-7	Contains (regardless of intentional or impurities)	chemical products
2507	Diphenyl Oxide	101-84-8	Contains (regardless of intentional or impurities)	chemical products
2508	Diglycidyl resorcinol ether	101-90-6	Contains (regardless of intentional or impurities)	chemical products
2509	Acetoacetanilide	102-01-2	Contains (regardless of intentional or impurities)	chemical products
2510	1,3-Diphenylguanidine	102-06-7	Contains (regardless of intentional or impurities)	chemical products
2511	Trimethoxyboroxine	102-24-9	1%	chemical products
2512	Benzenamine, N-ethyl-3-methyl-	102-27-2	Contains (regardless of intentional or impurities)	chemical products
2513	Dicyclopentadienyl iron	102-54-5	Contains (regardless of intentional or impurities)	chemical products
2514	Tripropyl aluminum	102-67-0	Contains (regardless of intentional or impurities)	chemical products
2515	Triethanolamine	102-71-6	Contains (regardless of intentional or impurities)	chemical products
2516	Ethanol, 2-(diethylamino)-	102-81-8	Contains (regardless of intentional or impurities)	chemical products
2517	Tributylamine	102-82-9	Contains (regardless of intentional or impurities)	chemical products
2518	Dihydrogen [orthoborato(3-)]O[phenylmercurate(2-)]	102-98-7	Contains (regardless of intentional or impurities)	chemical products
2519	Diazene, diphenyl-	103-33-3	Contains (regardless of intentional or impurities)	chemical products
2520	N-Ethylaniline	103-69-5	Contains (regardless of intentional or impurities)	chemical products
2521	Phenyl isocyanate	103-71-9	Contains (regardless of intentional or impurities)	chemical products
2522	Acetaminophen	103-90-2	1%	chemical products
2523	p-Toluenesulfonic acid	104-15-4	Contains (regardless of intentional or impurities)	chemical products
2524	Benzenecarbonitrile, 4-methoxy-	104-47-2	Contains (regardless of intentional or impurities)	chemical products
2525	p-Chlorobenzyl chloride	104-83-6	Contains (regardless of intentional or impurities)	chemical products
2526	Benzonitrile, 4-methyl-	104-85-8	Contains (regardless of intentional or impurities)	chemical products
2527	Benzenamine, 4-methoxy-	104-94-9	Contains (regardless of intentional or impurities)	chemical products
2528	Benzene, 1,4-diethyl-	105-06-6	1,000ppm	chemical products
2529	Benzonitrile, 4-formyl-	105-07-7	Intentional addition	chemical products
2530	p-Benzoquinone dioxime	105-11-3	Contains (regardless of intentional or impurities)	chemical products
2531	Acetic acid, cyano-, methyl ester	105-34-0	Intentional addition	chemical products
2532	Ethyl bromoacetate	105-36-2	Contains (regardless of intentional or impurities)	chemical products
2533	Ethyl chloroacetate	105-39-5	Contains (regardless of intentional or impurities)	chemical products
2534	Butanoic acid, 3-oxo-, methyl ester	105-45-3	Contains (regardless of intentional or impurities)	chemical products
2535	sec-Butyl acetate	105-46-4	Contains (regardless of intentional or impurities)	chemical products
2536	Ethyl cyanoacetate	105-56-6	Contains (regardless of intentional or impurities)	chemical products
2537	epsilon-Caprolactam	105-60-2	Contains (regardless of intentional or impurities)	chemical products
2538	2,4-Dimethylphenol	105-67-9	Contains (regardless of intentional or impurities)	chemical products
2539	3-Heptanone	106-35-4	Contains (regardless of intentional or impurities)	chemical products
2540	1,4-Dibromobenzene	106-37-6	1,000ppm	chemical products
2541	Benzene, 1-bromo-4-chloro-	106-39-8	1,000ppm	chemical products
2542	p-Xylene	106-42-3	Contains (regardless of intentional or impurities)	chemical products
2543	p-Chlorotoluene	106-43-4	Contains (regardless of intentional or impurities)	chemical products
2544	Phenol, 4-methyl-	106-44-5	Contains (regardless of intentional or impurities)	chemical products
2545	Benzene, 1,4-dichloro-	106-46-7	Contains (regardless of intentional or impurities)	chemical products
2546	4-Chloroaniline	106-47-8	Contains (regardless of intentional or impurities)	chemical products
2547	4-Chlorophenol	106-48-9	Contains (regardless of intentional or impurities)	chemical products
2548	p-Toluidine	106-49-0	Contains (regardless of intentional or impurities)	chemical products
2549	1,4-Benzenediamine	106-50-3	Contains (regardless of intentional or impurities)	chemical products
2550	Quinone	106-51-4	Contains (regardless of intentional or impurities)	chemical products
2551	7-Oxabicyclo[4.1.0]heptane, 3-(2-oxiranyl)-	106-87-6	Contains (regardless of intentional or impurities)	chemical products
2552	Oxirane, ethyl-	106-88-7	Contains (regardless of intentional or impurities)	chemical products
2553	Epichlorohydrin	106-89-8	Contains (regardless of intentional or impurities)	chemical products
2554	Glycidyl methacrylate	106-91-2	Contains (regardless of intentional or impurities)	chemical products
2555	Allyl glycidyl ether	106-92-3	Contains (regardless of intentional or impurities)	chemical products
2556	1,2-Dibromoethane	106-93-4	Contains (regardless of intentional or impurities)	chemical products
2557	Allyl bromide	106-95-6	Contains (regardless of intentional or impurities)	chemical products
2558	1-Propyne, 3-bromo-	106-96-7	Contains (regardless of intentional or impurities)	chemical products
2559	n-Butane	106-97-8	Contains (regardless of intentional or impurities)	chemical products
2560	1-Butene	106-98-9	Contains (regardless of intentional or impurities)	chemical products
2561	1,3-Butadiene	106-99-0	Contains (regardless of intentional or impurities)	chemical products
2562	2-Butene	107-01-7	Contains (regardless of intentional or impurities)	chemical products
2563	Acrolein	107-02-8	Contains (regardless of intentional or impurities)	chemical products
2564	1-Bromo-2-chloroethane	107-04-0	Contains (regardless of intentional or impurities)	chemical products
2565	1-Propene, 3-chloro-	107-05-1	Contains (regardless of intentional or impurities)	chemical products
2566	Ethanol, 2-chloro-	107-07-3	Contains (regardless of intentional or impurities)	chemical products
2567	1-Iodopropane	107-08-4	Contains (regardless of intentional or impurities)	chemical products
2568	Allylamine	107-11-9	Contains (regardless of intentional or impurities)	chemical products
2569	Propanenitrile	107-12-0	Contains (regardless of intentional or impurities)	chemical products
2570	Acrylonitrile	107-13-1	Contains (regardless of intentional or impurities)	chemical products
2571	Chloroacetonitrile	107-14-2	Contains (regardless of intentional or impurities)	chemical products
2572	Formaldehyde cyanohydrin	107-16-4	Contains (regardless of intentional or impurities)	chemical products
2573	Allyl alcohol	107-18-6	Contains (regardless of intentional or impurities)	chemical products
2574	2-Propyn-1-ol	107-19-7	Contains (regardless of intentional or impurities)	chemical products
2575	Chloroacetaldehyde	107-20-0	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
2576	Ethylene glycol	107-21-1	Contains (regardless of intentional or impurities)	chemical products
2577	Ethanedial	107-22-2	Contains (regardless of intentional or impurities)	chemical products
2578	Chloromethyl methyl ether	107-30-2	Contains (regardless of intentional or impurities)	chemical products
2579	Methyl formate	107-31-3	Contains (regardless of intentional or impurities)	chemical products
2580	Propylarsonic acid	107-34-6	Contains (regardless of intentional or impurities)	chemical products
2581	2,4-Pentanediol, 2-methyl-	107-41-5	Contains (regardless of intentional or impurities)	chemical products
2582	Hexamethyldisiloxane	107-46-0	Contains (regardless of intentional or impurities)	chemical products
2583	Diphosphoric acid, tetraethyl ester	107-49-3	Contains (regardless of intentional or impurities)	chemical products
2584	Octamethyltrisiloxane	107-51-7	1,000ppm	chemical products
2585	Dibutyl phosphate	107-66-4	Contains (regardless of intentional or impurities)	chemical products
2586	Butane, 1,3-dibromo-	107-90-2	1,000ppm	chemical products
2587	2-Bromopentane	107-81-3	Contains (regardless of intentional or impurities)	chemical products
2588	Butane, 1-bromo-3-methyl-	107-82-4	Contains (regardless of intentional or impurities)	chemical products
2589	2-Methylpentane	107-83-5	Contains (regardless of intentional or impurities)	chemical products
2590	Methyl propyl ketone	107-87-9	Contains (regardless of intentional or impurities)	chemical products
2591	2-Cyanoacetamide	107-91-5	Intentional addition	chemical products
2592	3-Chloropropionic acid	107-94-8	Contains (regardless of intentional or impurities)	chemical products
2593	2-Propanol, 1-methoxy-	107-98-2	Contains (regardless of intentional or impurities)	chemical products
2594	Ethanamine, 2-chloro-N,N-dimethyl-	107-99-3	Contains (regardless of intentional or impurities)	chemical products
2595	2-(Dimethylamino)ethanol	108-01-0	Contains (regardless of intentional or impurities)	chemical products
2596	1-Nitropropane	108-03-2	Contains (regardless of intentional or impurities)	chemical products
2597	Vinyl acetate	108-05-4	Contains (regardless of intentional or impurities)	chemical products
2598	2,4-Dimethylpentane	108-08-7	Contains (regardless of intentional or impurities)	chemical products
2599	2-Pentanone, 4-methyl-	108-10-1	Contains (regardless of intentional or impurities)	chemical products
2600	2-Pentanol, 4-methyl-	108-11-2	Contains (regardless of intentional or impurities)	chemical products
2601	Diisopropylamine	108-18-9	Contains (regardless of intentional or impurities)	chemical products
2602	Diisopropyl ether	108-20-3	Contains (regardless of intentional or impurities)	chemical products
2603	Isopropyl acetate	108-21-4	Contains (regardless of intentional or impurities)	chemical products
2604	Acetic anhydride	108-24-7	Contains (regardless of intentional or impurities)	chemical products
2605	Maleic anhydride	108-31-6	Contains (regardless of intentional or impurities)	chemical products
2606	Benzene, 1,3-dibromo-	108-36-1	1,000ppm	chemical products
2607	Benzene, 1-bromo-3-chloro-	108-37-2	1,000ppm	chemical products
2608	m-Xylene	108-38-3	Contains (regardless of intentional or impurities)	chemical products
2609	Phenol, 3-methyl-	108-39-4	Contains (regardless of intentional or impurities)	chemical products
2610	3-Chloroaniline	108-42-9	Contains (regardless of intentional or impurities)	chemical products
2611	m-Chlorophenol	108-43-0	Contains (regardless of intentional or impurities)	chemical products
2612	m-Toluidine	108-44-1	Contains (regardless of intentional or impurities)	chemical products
2613	1,3-Benzenediamine	108-45-2	Contains (regardless of intentional or impurities)	chemical products
2614	1,3-Benzenediol	108-46-3	Contains (regardless of intentional or impurities)	chemical products
2615	1,3-Divinylbenzene	108-57-6	1,000ppm	chemical products
2616	Bis(2-chloroisopropyl) ether	108-60-1	Contains (regardless of intentional or impurities)	chemical products
2617	Metaldehyde	108-62-3	Contains (regardless of intentional or impurities)	chemical products
2618	1,3,5-Trimethylbenzene	108-67-8	Contains (regardless of intentional or impurities)	chemical products
2619	3,5-Dimethylaniline	108-69-0	Contains (regardless of intentional or impurities)	chemical products
2620	1,3,5-Trichlorobenzene	108-70-3	Contains (regardless of intentional or impurities)	chemical products
2621	1,3-Benzenediamine, 5-methyl-	108-71-4	Intentional addition / 1%	chemical products
2622	1,3,5-Benzenetriamine	108-72-5	Contains (regardless of intentional or impurities)	chemical products
2623	1,3,5-Triazine, 2,4,6-trichloro-	108-77-0	Contains (regardless of intentional or impurities)	chemical products
2624	Diisobutyl ketone	108-83-8	Contains (regardless of intentional or impurities)	chemical products
2625	2-Pentanol, 4-methyl-, acetate	108-84-9	Contains (regardless of intentional or impurities)	chemical products
2626	Cyclohexane, bromo-	108-85-0	1,000ppm	chemical products
2627	Bromobenzene	108-86-1	Contains (regardless of intentional or impurities)	chemical products
2628	Methylcyclohexane	108-87-2	Contains (regardless of intentional or impurities)	chemical products
2629	Toluene	108-88-3	Contains (regardless of intentional or impurities)	chemical products
2630	Chlorobenzene	108-89-7	Contains (regardless of intentional or impurities)	chemical products
2631	Cyclohexylamine	108-91-6	Contains (regardless of intentional or impurities)	chemical products
2632	Cyclohexanol	108-93-0	Contains (regardless of intentional or impurities)	chemical products
2633	Cyclohexanone	108-94-1	Contains (regardless of intentional or impurities)	chemical products
2634	Phenol	108-95-2	Contains (regardless of intentional or impurities)	chemical products
2635	Benzenethiol	108-98-5	Contains (regardless of intentional or impurities)	chemical products
2636	3-Methylpyridine	108-99-6	Contains (regardless of intentional or impurities)	chemical products
2637	2-Chloropyridine	109-09-1	Contains (regardless of intentional or impurities)	chemical products
2638	Pentanoic acid	109-52-4	Contains (regardless of intentional or impurities)	chemical products
2639	1,3-Propanediamine, N1,N1-dimethyl-	109-55-7	Contains (regardless of intentional or impurities)	chemical products
2640	2-Isopropoxyethanol	109-59-1	Contains (regardless of intentional or impurities)	chemical products
2641	n-Propyl acetate	109-60-4	Contains (regardless of intentional or impurities)	chemical products
2642	Propyl chloroformate	109-61-5	Contains (regardless of intentional or impurities)	chemical products
2643	Boron trifluoride-diethyl etherate	109-63-7	Contains (regardless of intentional or impurities)	chemical products
2644	Propane, 1,3-dibromo-	109-64-8	Contains (regardless of intentional or impurities)	chemical products
2645	1-Bromobutane	109-65-9	Contains (regardless of intentional or impurities)	chemical products
2646	n-Pentane	109-66-0	Contains (regardless of intentional or impurities)	chemical products
2647	1-Chlorobutane	109-69-3	Contains (regardless of intentional or impurities)	chemical products
2648	Propane, 1-bromo-3-chloro-	109-70-6	Contains (regardless of intentional or impurities)	chemical products
2649	n-Butylamine	109-73-9	Contains (regardless of intentional or impurities)	chemical products
2650	n-Butanenitrile	109-74-0	Contains (regardless of intentional or impurities)	chemical products
2651	Allyl cyanide	109-75-1	Contains (regardless of intentional or impurities)	chemical products
2652	Propanedinitrile	109-77-3	Contains (regardless of intentional or impurities)	chemical products
2653	Propanenitrile, 3-hydroxy-	109-78-4	Contains (regardless of intentional or impurities)	chemical products
2654	1-Butanethiol	109-79-5	Contains (regardless of intentional or impurities)	chemical products
2655	Acetonitrile, (methylenamino)-	109-82-0	Contains (regardless of intentional or impurities)	chemical products
2656	Ethanol, 2-hydrazino-	109-84-2	Intentional addition / 1%	chemical products
2657	Methane, dimethoxy-	109-87-5	Contains (regardless of intentional or impurities)	chemical products
2658	Diethylamine	109-89-7	Contains (regardless of intentional or impurities)	chemical products
2659	Ethyl formate	109-94-4	Contains (regardless of intentional or impurities)	chemical products
2660	Ethyl nitrite	109-95-5	Contains (regardless of intentional or impurities)	chemical products
2661	Tetrahydrofuran	109-99-9	Contains (regardless of intentional or impurities)	chemical products
2662	Methyl isoamyl ketone	110-12-3	Contains (regardless of intentional or impurities)	chemical products
2663	Isobutyl acetate	110-19-0	Contains (regardless of intentional or impurities)	chemical products
2664	Methylene diacrylamide	110-26-9	Contains (regardless of intentional or impurities)	chemical products
2665	2-Heptanone	110-43-0	Contains (regardless of intentional or impurities)	chemical products
2666	Sorbic acid	110-44-1	Contains (regardless of intentional or impurities)	chemical products
2667	Nitrous acid, 3-methylbutyl ester	110-46-3	Contains (regardless of intentional or impurities)	chemical products
2668	Boron, trihydro(pyridine)-, (T-4)-	110-51-0	Contains (regardless of intentional or impurities)	chemical products
2669	Butane, 1,4-dibromo-	110-52-1	Contains (regardless of intentional or impurities)	chemical products
2670	1-Bromopentane	110-53-2	Contains (regardless of intentional or impurities)	chemical products
2671	Hexane	110-54-3	Contains (regardless of intentional or impurities)	chemical products
2672	1,4-Dichlorobutane	110-56-5	Contains (regardless of intentional or impurities)	chemical products
2673	trans-1,4-Dichloro-2-butene	110-57-6	Contains (regardless of intentional or impurities)	chemical products
2674	Pentanenitrile	110-59-8	Contains (regardless of intentional or impurities)	chemical products
2675	Succinonitrile	110-61-2	Contains (regardless of intentional or impurities)	chemical products
2676	Pentanal	110-62-3	Contains (regardless of intentional or impurities)	chemical products
2677	Propanenitrile, 3-methoxy-	110-67-8	Intentional addition	chemical products
2678	Cyclohexene	110-82-7	Contains (regardless of intentional or impurities)	chemical products
2679	Cyclohexene	110-83-8	Contains (regardless of intentional or impurities)	chemical products
2680	Piperazine	110-85-0	Contains (regardless of intentional or impurities)	chemical products
2681	Pyridine	110-86-1	Contains (regardless of intentional or impurities)	chemical products
2682	Piperidine	110-89-4	Contains (regardless of intentional or impurities)	chemical products
2683	Morpholine	110-91-8	Contains (regardless of intentional or impurities)	chemical products
2684	Heptanoic acid	111-14-8	Contains (regardless of intentional or impurities)	chemical products
2685	Pentane, 1,5-dibromo-	111-24-0	1,000ppm	chemical products
2686	1-Bromohexane	111-25-1	Contains (regardless of intentional or impurities)	chemical products
2687	Diethylenetriamine	111-40-0	Contains (regardless of intentional or impurities)	chemical products
2688	Ethanol, 2-[(2-aminoethyl)amino]-	111-41-1	Contains (regardless of intentional or impurities)	chemical products
2689	Diethanolamine	111-42-2	Contains (regardless of intentional or impurities)	chemical products
2690	Bis(2-chloroethyl) ether	111-44-4	Contains (regardless of intentional or impurities)	chemical products
2691	Octane	111-65-9	Contains (regardless of intentional or impurities)	chemical products
2692	Hexanedinitrile	111-69-3	Contains (regardless of intentional or impurities)	chemical products
2693	2-Butoxyethanol	111-76-2	Contains (regardless of intentional or impurities)	chemical products
2694	Diethylene glycol monomethyl ether	111-77-3	Contains (regardless of intentional or impurities)	chemical products
2695	1-Bromooctane	111-83-1	1,000ppm	chemical products
2696	Nonane	111-84-2	Contains (regardless of intentional or impurities)	chemical products
2697	Octyl chloride	111-85-3	1,000ppm	chemical products
2698	1-Octanol	111-87-5	1%	chemical products
2699	Di-n-butylamine	111-92-2	Contains (regardless of intentional or impurities)	chemical products
2700	Propanenitrile, 3,3'-iminobis-	111-94-4	Contains (regardless of intentional or impurities)	chemical products
2701	Propanenitrile, 3,3'-thiobis-	111-97-7	Contains (regardless of intentional or impurities)	chemical products
2702	1-Hexadecanaminium, N,N,N-trimethyl-, chloride	112-02-7	1%	chemical products
2703	Ethylene glycol monobutyl ether acetate	112-07-2	Contains (regardless of intentional or impurities)	chemical products
2704	Lauryldimethylamine	112-18-5	1%	chemical products
2705	Triethylenetetramine	112-24-3	Contains (regardless of intentional or impurities)	chemical products
2706	Decane, 1-bromo-	112-29-8	1,000ppm	chemical products
2707	1-Decanol	112-30-1	1%	chemical products
2708	Diethylene glycol monobutyl ether	112-34-5	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
2709	1-Dodecanol	112-53-8	1%	chemical products
2710	Tetraethylenepentamine	112-57-2	Contains (regardless of intentional or impurities)	chemical products
2711	Tetradecane, 1-bromo-	112-71-0	1,000ppm	chemical products
2712	Hexadecane, 1-bromo-	112-82-3	1,000ppm	chemical products
2713	Octadecane, 1-bromo-	112-89-0	1,000ppm	chemical products
2714	Propoxur	114-26-1	Contains (regardless of intentional or impurities)	chemical products
2715	Propene	115-07-1	Contains (regardless of intentional or impurities)	chemical products
2716	Isobutene	115-11-7	Contains (regardless of intentional or impurities)	chemical products
2717	2,2-Bis(ethylsulphonyl)propane	115-24-2	100%	chemical products
2718	Octafluorocyclobutane	115-24-2	Contains (regardless of intentional or impurities)	chemical products
2719	Chloroacetic acid	115-26-6	Contains (regardless of intentional or impurities)	chemical products
2720	Triphenyl phosphite	115-86-6	Contains (regardless of intentional or impurities)	chemical products
2721	Fensulfothion	115-90-2	Contains (regardless of intentional or impurities)	chemical products
2722	Tetrafluoroethylene	116-14-3	Contains (regardless of intentional or impurities)	chemical products
2723	Hexafluoropropylene	116-15-4	Contains (regardless of intentional or impurities)	chemical products
2724	Glycobiarsol	116-49-4	Contains (regardless of intentional or impurities)	chemical products
2725	Methyl dichloroacetate	116-54-1	Contains (regardless of intentional or impurities)	chemical products
2726	9,10-Anthracenedione, 1,5-dihydroxy-	117-12-4	Contains (regardless of intentional or impurities)	chemical products
2727	2-Aminoanthraquinone	117-79-3	Contains (regardless of intentional or impurities)	chemical products
2728	Di-n-octyl phthalate	117-84-0	Contains (regardless of intentional or impurities)	chemical products
2729	Copper, [2,9,16,23-tetranitro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-1)-	118-20-7	Intentional addition / 1,000ppm	chemical products
2730	1,3-Dichloro-5,5-dimethylhydantoin	118-52-5	Contains (regardless of intentional or impurities)	chemical products
2731	2,3,5,6-Tetrachloro-2,5-cyclohexadiene-1,4-dione	118-75-2	Contains (regardless of intentional or impurities)	chemical products
2732	Phenol, 2,4,6-tribromo-	118-79-6	Contains (regardless of intentional or impurities)	chemical products
2733	Phenol, 4,4'-methylenebis[2,6-bis(1,1-dimethylethyl)-	118-82-1	Intentional addition / 1,000ppm	chemical products
2734	2,4,6-Trinitrotoluene	118-96-7	Contains (regardless of intentional or impurities)	chemical products
2735	O,O-Diethyl O-(1,6-dihydro-6-oxo-1-phenylpyridazin-3-yl) thiophosphate	119-12-0	Intentional addition / 1%	chemical products
2736	Phenol, 4-[(2,4-dinitrophenyl)amino]-	119-15-3	Contains (regardless of intentional or impurities)	chemical products
2737	Benzophenone	119-61-9	Contains (regardless of intentional or impurities)	chemical products
2738	3,3'-Dimethoxybenzidine	119-90-4	Contains (regardless of intentional or impurities)	chemical products
2739	3,3'-Dimethylbenzidine	119-93-7	Contains (regardless of intentional or impurities)	chemical products
2740	Propanenitrile, 3-[(2-hydroxyethyl)(3-methylphenyl)amino]-	119-95-9	Intentional addition	chemical products
2741	Arstholin	119-96-0	Contains (regardless of intentional or impurities)	chemical products
2742	Pentyl (2,4,5-trichlorophenoxy)acetate	120-39-8	Intentional addition / 1,000ppm	chemical products
2743	Piperidine, 1,1'-(tetrathiodicarbonothioyl)bis-	120-54-7	1,000ppm	chemical products
2744	Dimethyl terephthalate	120-61-6	1%	chemical products
2745	2,2'-Dibenzothiazyl disulfide	120-78-5	Contains (regardless of intentional or impurities)	chemical products
2746	1,2-Benzenediol	120-80-9	Contains (regardless of intentional or impurities)	chemical products
2747	1,2,4-Trichlorobenzene	120-82-1	Contains (regardless of intentional or impurities)	chemical products
2748	2,4-Dichlorophenol	120-83-2	Contains (regardless of intentional or impurities)	chemical products
2749	Phenol, 2-(1,1-dimethylethyl)-4-methoxy-	121-00-6	1%	chemical products
2750	Roxarsone	121-19-7	Contains (regardless of intentional or impurities)	chemical products
2751	Boric acid (H3BO3), trimethyl ester	121-43-7	Contains (regardless of intentional or impurities)	chemical products
2752	Triethylamine	121-44-8	Contains (regardless of intentional or impurities)	chemical products
2753	Trimethyl phosphite	121-45-9	Contains (regardless of intentional or impurities)	chemical products
2754	Carbaryl	121-59-5	Contains (regardless of intentional or impurities)	chemical products
2755	Benzenesulfonic acid, 4-dodecyl-	121-65-3	1%	chemical products
2756	N,N-Dimethylaniline	121-69-7	Contains (regardless of intentional or impurities)	chemical products
2757	Malathion	121-75-5	Contains (regardless of intentional or impurities)	chemical products
2758	Cyclonite	121-82-4	Contains (regardless of intentional or impurities)	chemical products
2759	Benzenamine, 2-chloro-4-nitro-	121-87-9	Contains (regardless of intentional or impurities)	chemical products
2760	Benzoyl chloride, 3-nitro-	121-90-4	Contains (regardless of intentional or impurities)	chemical products
2761	3-Nitrobenzoic acid	121-92-6	Contains (regardless of intentional or impurities)	chemical products
2762	Benzoyl chloride, 4-nitro-	122-04-3	Contains (regardless of intentional or impurities)	chemical products
2763	Fenitrothion	122-04-3	Contains (regardless of intentional or impurities)	chemical products
2764	Benzenemethanaminium, N-hexadecyl-N,N-dimethyl-, chloride	122-16-9	1,000ppm	chemical products
2765	Dimethylbenzyloctadecylammonium chloride	122-18-9	1,000ppm	chemical products
2766	Simazine	122-34-9	Contains (regardless of intentional or impurities)	chemical products
2767	Diphenylamine	122-39-4	Contains (regardless of intentional or impurities)	chemical products
2768	Borane, tributyl-	122-56-5	Contains (regardless of intentional or impurities)	chemical products
2769	Benzylidene acetone	122-57-6	Contains (regardless of intentional or impurities)	chemical products
2770	Phenyl glycidyl ether	122-60-1	Contains (regardless of intentional or impurities)	chemical products
2771	Hydrazobenzene	122-68-7	Contains (regardless of intentional or impurities)	chemical products
2772	p-Acetoaminoaniline	122-80-5	Contains (regardless of intentional or impurities)	chemical products
2773	2-Phenoxyethanol	122-99-6	Contains (regardless of intentional or impurities)	chemical products
2774	Pyridinium, 1-hexadecyl-, chloride	123-03-5	Intentional addition / 1,000ppm	chemical products
2775	Propanedinitrile, (ethoxymethylene)-	123-06-8	Intentional addition	chemical products
2776	4-Heptanone	123-19-3	Contains (regardless of intentional or impurities)	chemical products
2777	4-Aminophenol	123-30-8	Contains (regardless of intentional or impurities)	chemical products
2778	1,4-Benzenediol	123-31-9	Contains (regardless of intentional or impurities)	chemical products
2779	Propionaldehyde	123-38-6	Contains (regardless of intentional or impurities)	chemical products
2780	N-Methylformamide	123-39-7	Contains (regardless of intentional or impurities)	chemical products
2781	Diacetone alcohol	123-42-2	Contains (regardless of intentional or impurities)	chemical products
2782	1-Butanol, 3-methyl-	123-51-3	Contains (regardless of intentional or impurities)	chemical products
2783	2,4-Pentanedione	123-54-6	Contains (regardless of intentional or impurities)	chemical products
2784	Butyraldehyde	123-72-8	Contains (regardless of intentional or impurities)	chemical products
2785	2-Butenal, (2E)-	123-73-9	Contains (regardless of intentional or impurities)	chemical products
2786	Pyrrolidine	123-75-1	Contains (regardless of intentional or impurities)	chemical products
2787	n-Butyl acetate	123-86-4	Contains (regardless of intentional or impurities)	chemical products
2788	Isoamyl acetate	123-92-2	Contains (regardless of intentional or impurities)	chemical products
2789	2-Octanol	123-96-6	1%	chemical products
2790	Hexanedioic acid	124-04-9	Contains (regardless of intentional or impurities)	chemical products
2791	1,6-Hexanediamine	124-09-4	Contains (regardless of intentional or impurities)	chemical products
2792	n-Octadecylamine	124-30-1	Contains (regardless of intentional or impurities)	chemical products
2793	Dimethylamine	124-40-3	Contains (regardless of intentional or impurities)	chemical products
2794	Urea, compound with hydrogen peroxide (H2O2) (1:1)	124-43-6	Contains (regardless of intentional or impurities)	chemical products
2795	Chlorodibromomethane	124-48-1	Intentional addition / 1,000ppm	chemical products
2796	Methylarsonic acid	124-58-3	Contains (regardless of intentional or impurities)	chemical products
2797	Methanesulfonyl chloride	124-63-0	Contains (regardless of intentional or impurities)	chemical products
2798	Sodium cacodylate	124-65-2	Contains (regardless of intentional or impurities)	chemical products
2799	Ethane, 2-bromo-1,1,2-tetrafluoro-	124-72-1	Contains (regardless of intentional or impurities)	chemical products
2800	Ethane, 1,2-dibromo-1,1,2,2-tetrafluoro-	124-73-2	Contains (regardless of intentional or impurities)	chemical products
2801	Codeine hydroiodide	125-26-8	1%	chemical products
2802	4-Dimethylamino-2,2-diphenylvaleronitrile	125-79-1	Intentional addition	chemical products
2803	Tris(2,3-dibromopropyl) phosphate	126-72-7	Contains (regardless of intentional or impurities)	chemical products
2804	Tributyl phosphate	126-73-8	Contains (regardless of intentional or impurities)	chemical products
2805	Disodium arsonoacetate	126-82-9	Contains (regardless of intentional or impurities)	chemical products
2806	Nitrogen mustard N-oxide	126-85-2	Contains (regardless of intentional or impurities)	chemical products
2807	Methacrylonitrile	126-99-7	Contains (regardless of intentional or impurities)	chemical products
2808	2-Chloro-1,3-butadiene	126-99-8	Contains (regardless of intentional or impurities)	chemical products
2809	1-Chloro-2-propanol	127-00-4	Contains (regardless of intentional or impurities)	chemical products
2810	Chloramine-T	127-65-1	Contains (regardless of intentional or impurities)	chemical products
2811	Benzenesulfonic acid, 4-hydroxy-, zinc salt (2:1)	127-82-2	Intentional addition / 1%	chemical products
2812	Sodium arsenite	127-85-5	Contains (regardless of intentional or impurities)	chemical products
2813	Ethanedioic acid, monopotassium salt	127-95-7	Intentional addition / 1,000ppm	chemical products
2814	Ethanedioic acid, potassium salt (2:1)	127-98-8	Intentional addition / 1,000ppm	chemical products
2815	Potassium dimethyldithiocarbamate	128-03-0	Intentional addition / 1,000ppm	chemical products
2816	Sodium dimethyldithiocarbamate	128-04-1	Contains (regardless of intentional or impurities)	chemical products
2817	Phenol, 2,6-bis(1,1-dimethylethyl)-4-methyl-	128-37-0	Intentional addition / 100ppm	chemical products
2818	2,6-Di-tert-butylphenol	128-39-2	1,000ppm	chemical products
2819	1,4-Diaminoanthraquinone	128-95-0	Contains (regardless of intentional or impurities)	chemical products
2820	2-Methyl-1-nitroanthraquinone	129-15-7	Contains (regardless of intentional or impurities)	chemical products
2821	Endothal-disodium	129-67-9	Contains (regardless of intentional or impurities)	chemical products
2822	Succinamic acid, N-((2-methoxy-3-((1,2,3,6-tetrahydro-1,3-dimethyl-2,6-dioxopurin-7-yl)mercurio)propyl)carbamoyl)-, sodium salt	129-99-7	Contains (regardless of intentional or impurities)	chemical products
2823	1,4-Naphthalenedione	130-15-4	Contains (regardless of intentional or impurities)	chemical products
2824	2-(4-Aminophenyl)-6-methyl-7-benzothiazole sulfonic acid	130-17-6	Contains (regardless of intentional or impurities)	chemical products
2825	Dimethyl phthalate	131-11-3	Contains (regardless of intentional or impurities)	chemical products
2826	Diallyl phthalate	131-17-9	Contains (regardless of intentional or impurities)	chemical products
2827	Methanone, (2-hydroxy-4-methoxyphenyl)(2-hydroxyphenyl)-	131-53-3	Contains (regardless of intentional or impurities)	chemical products
2828	2,4-Dihydroxybenzophenone	131-56-6	1,000ppm	chemical products
2829	2-Butenoic acid, 2-(1-methylheptyl)-4,6-dinitrophenyl ester, (E)-	131-72-6	Intentional addition	chemical products
2830	Ammonium picrate	131-74-8	Contains (regardless of intentional or impurities)	chemical products
2831	Dinex	131-89-5	Contains (regardless of intentional or impurities)	chemical products
2832	Iron, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-1)-	132-16-1	1%	chemical products
2833	Sodium o-phenylphenol	132-27-4	Contains (regardless of intentional or impurities)	chemical products
2834	3-Amino-9-ethylcarbazole	132-32-1	Contains (regardless of intentional or impurities)	chemical products
2835	2,7-Naphthalenedisulfonic acid, 4-[(2-arsenophenyl)azo]-3-hydroxy-	132-33-2	Contains (regardless of intentional or impurities)	chemical products
2836	1-Naphthalenecetonitrile	132-75-2	Intentional addition	chemical products
2837	Captan	133-06-2	Contains (regardless of intentional or impurities)	chemical products
2838	Folpet	133-07-3	Contains (regardless of intentional or impurities)	chemical products
2839	1-Deoxy-1-(methylamino)-D-glucitol, compound with antimonic acid (1:1)	133-51-7	Contains (regardless of intentional or impurities)	chemical products
2840	6-Methyl-3-nitrobenzoxamercurate	133-58-4	Contains (regardless of intentional or impurities)	chemical products
2841	8-Quinololin, sulfate (2:1) (salt)	134-31-6	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
2842	1-Naphthylamine	134-32-7	Contains (regardless of intentional or impurities)	chemical products
2843	2-Naphthalenol	135-19-3	Contains (regardless of intentional or impurities)	chemical products
2844	2,7-Naphthalenedisulfonic acid, 3-amino-, disodium salt	135-50-2	Contains (regardless of intentional or impurities)	chemical products
2845	N-Phenyl-2-naphthylamine	135-88-6	Contains (regardless of intentional or impurities)	chemical products
2846	Hexanoic acid, 2-ethyl-, cobalt(2+) salt (2:1)	136-52-7	Intentional addition / 1,000ppm	chemical products
2847	Sesone	136-78-7	Contains (regardless of intentional or impurities)	chemical products
2848	o-Nonylphenol	136-83-4	Intentional addition / 1%	chemical products
2849	N,N,6-Triethyl-5-thioxo-2,4-dithia-3-selena-6-azaoctanethioamide	136-92-5	Contains (regardless of intentional or impurities)	chemical products
2850	Methyl 2-cyanoacrylate	137-06-3	Contains (regardless of intentional or impurities)	chemical products
2851	Benzeneethiol, 2-amino-	137-07-5	Contains (regardless of intentional or impurities)	chemical products
2852	2,4,5-Trimethylaniline	137-17-7	Contains (regardless of intentional or impurities)	chemical products
2853	Thiram	137-26-6	Contains (regardless of intentional or impurities)	chemical products
2854	Copper(II) dimethyldithiocarbamate	137-29-1	Intentional addition / 1,000ppm	chemical products
2855	Ziram	137-30-4	Contains (regardless of intentional or impurities)	chemical products
2856	Potassium N-methyldithiocarbamate	137-41-7	Contains (regardless of intentional or impurities)	chemical products
2857	Metam-sodium	137-42-8	Contains (regardless of intentional or impurities)	chemical products
2858	Propanoic acid, 2-hydroxy-, butyl ester	138-22-7	Intentional addition / 1%	chemical products
2859	p-Acetamidobenzenesulfonic acid, sodium salt	138-31-8	Contains (regardless of intentional or impurities)	chemical products
2860	Mercurate(1-), (4-carboxylatophenyl)hydroxy-, sodium	138-85-2	Contains (regardless of intentional or impurities)	chemical products
2861	Disodium cyanodithioimidocarbonate	138-93-2	Intentional addition / 100ppm	chemical products
2862	Benzylidimethyldodecylammonium chloride	139-07-1	Intentional addition / 1,000ppm	chemical products
2863	Benzenemethanaminium, N,N-dimethyl-N-tetradecyl-, chloride	139-08-2	Intentional addition / 1,000ppm	chemical products
2864	Nitrioltriacetic acid	139-13-9	Contains (regardless of intentional or impurities)	chemical products
2865	Tris[oxalate(2-)]dicerium	139-42-4	Intentional addition / 1,000ppm	chemical products
2866	4,4'-Thiodianiline	139-65-1	Contains (regardless of intentional or impurities)	chemical products
2867	M-nonylphenol	139-84-4	Intentional addition / 1%	chemical products
2868	6,6'-Dihydroxy-3,3'-diarsene-1,2-diydianilinium dichloride	139-93-5	Contains (regardless of intentional or impurities)	chemical products
2869	Benzyl acetate	140-11-4	Intentional addition / 1%	chemical products
2870	Methoxyoximercuripropylsuccinyl urea	140-20-5	Contains (regardless of intentional or impurities)	chemical products
2871	Benzyl cyanide	140-29-4	Contains (regardless of intentional or impurities)	chemical products
2872	Sodium hydrogen [4-[(hydroxyacetyl)amino]phenyl]arsenate	140-45-4	Contains (regardless of intentional or impurities)	chemical products
2873	Benzeneacetonitrile, 4-chloro-	140-53-4	Contains (regardless of intentional or impurities)	chemical products
2874	Fenaminosulf	140-56-7	Contains (regardless of intentional or impurities)	chemical products
2875	Benzenesulfonic acid, 4-decyl-	140-60-3	Intentional addition / 1%	chemical products
2876	Cycacetide	140-87-4	Intentional addition	chemical products
2877	Ethyl acrylate	140-88-5	Contains (regardless of intentional or impurities)	chemical products
2878	Dimethylolurea	140-95-4	Intentional addition / 1,000ppm	chemical products
2879	Cadmium succinate	141-00-4	Contains (regardless of intentional or impurities)	chemical products
2880	2-Butenedioic acid (E)-, iron(2+) salt (1:1)	141-01-5	Intentional addition / 1,000ppm	chemical products
2881	n-Butyl acrylate	141-32-2	Contains (regardless of intentional or impurities)	chemical products
2882	Ethanolamine	141-43-5	Contains (regardless of intentional or impurities)	chemical products
2883	Dicrotophos	141-66-2	Contains (regardless of intentional or impurities)	chemical products
2884	Propanoic acid, 3-iodo-	141-76-4	Contains (regardless of intentional or impurities)	chemical products
2885	Ethyl acetate	141-78-6	Contains (regardless of intentional or impurities)	chemical products
2886	3-Penten-2-one, 4-methyl-	141-79-7	Contains (regardless of intentional or impurities)	chemical products
2887	Aniline hydrochloride	142-04-1	Contains (regardless of intentional or impurities)	chemical products
2888	1,3-Dichloropropane	142-28-9	Contains (regardless of intentional or impurities)	chemical products
2889	Nabam	142-59-6	Contains (regardless of intentional or impurities)	chemical products
2890	Hexanoic acid	142-62-1	Contains (regardless of intentional or impurities)	chemical products
2891	Piperazine, hexahydrate	142-63-2	Intentional addition / 1%	chemical products
2892	Piperazine dihydrochloride	142-64-3	Contains (regardless of intentional or impurities)	chemical products
2893	Acetic acid, copper(2+) salt	142-71-2	Intentional addition / 1,000ppm	chemical products
2894	n-Heptane	142-82-5	Contains (regardless of intentional or impurities)	chemical products
2895	Dipropylamine	142-84-7	Contains (regardless of intentional or impurities)	chemical products
2896	1-Nonanol	143-08-8	Intentional addition / 1%	chemical products
2897	Lauryl bromide	143-15-7	Intentional addition / 1,000ppm	chemical products
2898	1-(6-Hexanediamine, N-(6-amino)hexyl)-	143-23-7	Intentional addition / 100ppm	chemical products
2899	Sodium cyanide	143-32-9	Contains (regardless of intentional or impurities)	chemical products
2900	Borate(1-), tetraphenyl-, sodium	143-68-8	Intentional addition / 1%	chemical products
2901	Disodium methylarsenate	144-21-8	Contains (regardless of intentional or impurities)	chemical products
2902	Selenium dimethyldithiocarbamate	144-34-3	Contains (regardless of intentional or impurities)	chemical products
2903	Fluoroacetic acid	144-49-0	Contains (regardless of intentional or impurities)	chemical products
2904	Methyldithiocarbamic acid	144-54-7	Intentional addition / 1%	chemical products
2905	Oxalic acid	144-62-7	Contains (regardless of intentional or impurities)	chemical products
2906	4-(Glycolylamino)phenylarsonic acid	144-87-6	Contains (regardless of intentional or impurities)	chemical products
2907	Endothal	145-73-3	Contains (regardless of intentional or impurities)	chemical products
2908	Silver picrate	146-84-9	Contains (regardless of intentional or impurities)	chemical products
2909	Copper, [2-chloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-2)-	147-13-7	Intentional addition / 1,000ppm	chemical products
2910	C.I. Pigment Blue 15	147-14-8	Intentional addition / 1,000ppm	chemical products
2911	Dinitolmide	148-01-6	Intentional addition / 1%	chemical products
2912	8-Hydroxyquinoline	148-24-3	Contains (regardless of intentional or impurities)	chemical products
2913	2-(Ethylmercuriothio)benzoic acid	148-61-8	Contains (regardless of intentional or impurities)	chemical products
2914	Propanenitrile, 3-[ethyl(3-methylphenyl)amino]-	148-69-6	Intentional addition	chemical products
2915	Thiabenzazole	148-79-8	Contains (regardless of intentional or impurities)	chemical products
2916	Propanenitrile, 3-(ethylphenylamino)-	148-87-8	Intentional addition	chemical products
2917	Hexanoic acid, 2-ethyl-, copper(2+) salt	149-11-1	Intentional addition / 1,000ppm	chemical products
2918	Procaine borate	149-13-3	Intentional addition / 1%	chemical products
2919	2-Mercaptobenzothiazole	149-30-4	Contains (regardless of intentional or impurities)	chemical products
2920	2-Ethylhexanoic acid	149-57-5	Contains (regardless of intentional or impurities)	chemical products
2921	Boric acid (H3BO3), triethyl ester	150-46-9	Contains (regardless of intentional or impurities)	chemical products
2922	p-Dimethylaminobenzenediazo sulfonate	150-70-9	Intentional addition / 1%	chemical products
2923	4-Methoxyphenol	150-76-5	Contains (regardless of intentional or impurities)	chemical products
2924	Propanenitrile, 3-amino-	151-18-8	Intentional addition	chemical products
2925	Sodium lauryl sulfate	151-21-3	Intentional addition / 1%	chemical products
2926	Potassium cyanide	151-50-8	Contains (regardless of intentional or impurities)	chemical products
2927	Ethyleneimine	151-56-4	Contains (regardless of intentional or impurities)	chemical products
2928	Aminoacetonitrile bisulphate	151-63-3	Intentional addition	chemical products
2929	Ethane, 2-bromo-2-chloro-1,1,1-trifluoro-	151-67-7	Intentional addition / 1,000ppm	chemical products
2930	Verapamil hydrochloride	152-11-4	Intentional addition	chemical products
2931	Octamethylpyrophosphoramide	152-16-9	Contains (regardless of intentional or impurities)	chemical products
2932	Benzenamine, 4-ethoxy-	156-43-4	Contains (regardless of intentional or impurities)	chemical products
2933	cis-1,2-Dichloroethylene	156-59-2	Contains (regardless of intentional or impurities)	chemical products
2934	Ethene, 1,2-dichloro-, (1E)-	156-60-5	Contains (regardless of intentional or impurities)	chemical products
2935	Cyanamide, calcium salt (1:1)	156-62-7	Contains (regardless of intentional or impurities)	chemical products
2936	Benzo(e)pyrene	192-97-2	Contains (regardless of intentional or impurities)	chemical products
2937	Benzo(f)fluoranthene	205-82-3	Contains (regardless of intentional or impurities)	chemical products
2938	Benzo(b)fluoranthene	205-99-2	Contains (regardless of intentional or impurities)	chemical products
2939	Dibenzo-p-dioxin	262-12-4	Intentional addition / 1,000ppm	chemical products
2940	Benzfuran	271-89-6	Contains (regardless of intentional or impurities)	chemical products
2941	Benzo(b)selonophene	272-30-0	Contains (regardless of intentional or impurities)	chemical products
2942	2,1,3-Benzoselenadiazole	273-15-4	Contains (regardless of intentional or impurities)	chemical products
2943	1,3,2-Benzodioxaborole	274-07-7	Intentional addition / 1%	chemical products
2944	9-Borabicyclo[3.3.1]nonane	280-64-8	Contains (regardless of intentional or impurities)	chemical products
2945	2,8,9-Trioxo-5-aza-1-borabicyclo[3.3.1]undecane	283-56-7	Intentional addition / 1%	chemical products
2946	Cyclopentane	287-92-3	Contains (regardless of intentional or impurities)	chemical products
2947	Selenophene	288-05-1	Contains (regardless of intentional or impurities)	chemical products
2948	1-Imidazole	288-32-4	Contains (regardless of intentional or impurities)	chemical products
2949	Cyclododecane	294-62-2	Intentional addition / 1%	chemical products
2950	Isobenzan	297-78-9	Contains (regardless of intentional or impurities)	chemical products
2951	Parathion-methyl	298-00-0	Contains (regardless of intentional or impurities)	chemical products
2952	Phorate	298-02-2	Contains (regardless of intentional or impurities)	chemical products
2953	Disulfoton	298-04-4	Contains (regardless of intentional or impurities)	chemical products
2954	Phosphoric acid, bis(2-ethylhexyl) ester	298-07-7	Contains (regardless of intentional or impurities)	chemical products
2955	Iron, bis(D-gluconato-O1,O2)-	299-29-6	Intentional addition / 1%	chemical products
2956	Ronnel	299-84-3	Contains (regardless of intentional or impurities)	chemical products
2957	Crufomate	299-86-5	Contains (regardless of intentional or impurities)	chemical products
2958	Naled	300-76-5	Contains (regardless of intentional or impurities)	chemical products
2959	Hexachlorotris(1,2-dihydro-1,5-dimethyl-2-phenyl-3H-pyrazol-3-one)diron	301-06-4	Intentional addition / 1%	chemical products
2960	Hexanoic acid, 2-ethyl-, tin(2+) salt (2:1)	301-10-0	Contains (regardless of intentional or impurities)	chemical products
2961	Pirithamide	302-41-0	Intentional addition	chemical products
2962	Anthiolimine	305-97-5	Contains (regardless of intentional or impurities)	chemical products
2963	Oxophenarsine	306-12-7	Contains (regardless of intentional or impurities)	chemical products
2964	Ethane, 1,1,2,2-tetrabromo-1-fluoro-	306-80-9	Contains (regardless of intentional or impurities)	chemical products
2965	Ethane, 2,2-dichloro-1,1,1-trifluoro-	306-83-2	Intentional addition / 1,000ppm	chemical products
2966	1,1,2,2,3,3,4,4,5,5,6,6-Decafluoro-5,6-bis(trifluoromethyl)cyclohexane	306-98-9	Intentional addition / 1%	chemical products
2967	Octane, octadecafluoro-	307-34-6	Intentional addition / 1%	chemical products
2968	1-Bromohexacosafuorodecane	307-43-7	Intentional addition / 1,000ppm	chemical products
2969	Undecane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11-tricosafuoro-11-iodo-	307-50-6	Intentional addition / 1,000ppm	chemical products
2970	Dodecane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12-pentacosafuoro-12-iodo-	307-60-8	Intentional addition / 1,000ppm	chemical products
2971	Tetradecane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14-nonacosafuoro-14-iodo-	307-63-1	Intentional addition / 1,000ppm	chemical products
2972	Bromacil	314-40-9	Intentional addition / 1%	chemical products
2973	.delta.-BHC	319-86-8	Contains (regardless of intentional or impurities)	chemical products
2974	Boron, trifluoro(methyl benzoate-O)-, (T-4)-	325-51-9	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
2975	Benzeneacetonitrile, 2-fluoro-	326-62-5	Contains (regardless of intentional or impurities)	chemical products
2976	1,4-Dibromo-2,5-difluorobenzene	327-51-5	Intentional addition / 1,000ppm	chemical products
2977	1-Bromo-2,4,5-trifluorobenzene	327-52-6	Intentional addition / 1,000ppm	chemical products
2978	1,2,4,5-Tetrafluorobenzene	327-54-8	Intentional addition / 1,000ppm	chemical products
2979	Benzene, 1,5-difluoro-2,4-dinitro-	327-92-4	Intentional addition / 1%	chemical products
2980	2,6,7-Trioxa-1-stibabicyclo[2.2.1]heptane	328-55-2	Contains (regardless of intentional or impurities)	chemical products
2981	1-Bromo-3,5-bis(trifluoromethyl)benzene	328-70-1	Intentional addition / 1,000ppm	chemical products
2982	Benzonitrile, 2-chloro-5-(trifluoromethyl)-	328-67-0	Intentional addition	chemical products
2983	2,5-Dinitrophenol	328-71-5	Contains (regardless of intentional or impurities)	chemical products
2984	Duron	330-54-1	Contains (regardless of intentional or impurities)	chemical products
2985	Urea, N'-(3,4-dichlorophenyl)-N-methoxy-N-methyl-	330-55-2	Contains (regardless of intentional or impurities)	chemical products
2986	1-(2-Chloroethyl)-4-fluorobenzene	332-43-4	Intentional addition / 1,000ppm	chemical products
2987	Dichloro(2-chlorovinyl)arsine oxide	333-25-5	Intentional addition / 1%	chemical products
2988	Diethyl-(1,3-dithiocyclopentylidene)-thiophosphoramidate	333-29-9	Intentional addition	chemical products
2989	Diazon	333-41-5	Contains (regardless of intentional or impurities)	chemical products
2990	Decanoic acid	334-48-5	Contains (regardless of intentional or impurities)	chemical products
2991	Diazomethane	334-88-3	Contains (regardless of intentional or impurities)	chemical products
2992	Methanesulfonyl fluoride, trifluoro-	335-05-7	Contains (regardless of intentional or impurities)	chemical products
2993	Furan, 2,2,3,3,4,4,5-heptafluorotetrahydro-5-(nonafluorobutyl)-	335-38-4	Intentional addition / 1%	chemical products
2994	Heptane, hexadecafluoro-	335-57-9	Intentional addition / 1%	chemical products
2995	1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8-Hepta-decafluorooctane	335-65-9	Intentional addition / 1,000ppm	chemical products
2996	Octanoyl fluoride, penta-decafluoro-	335-66-0	Contains (regardless of intentional or impurities)	chemical products
2997	Pentadecane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14,15,15-hentriacontafuoro-15-iodo-	335-79-5	Intentional addition / 100ppm	chemical products
2998	Styrynidin-10-one, 2,2'-difluoro-5,5'-dimethyl-6,6'-dinitro[1,1'-biphenyl]-3,3'-dicarboxylate (2:1)	337-37-1	Contains (regardless of intentional or impurities)	chemical products
2999	Styrynidin-10-one, 5,5'-dichloro-2,2',6,6'-tetrafluoro[1,1'-biphenyl]-3,3'-dicarboxylate (2:1)	337-38-2	Contains (regardless of intentional or impurities)	chemical products
3000	Styrynidin-10-one, mono(2'-fluoro-5'-methyl-6-nitro[1,1'-biphenyl]-2-carboxylate)	337-39-3	Contains (regardless of intentional or impurities)	chemical products
3001	Tetrapropylammonium tetrafluoroborate	338-38-5	Intentional addition / 1%	chemical products
3002	Ethane, 1-chloro-1,2-difluoro-	338-64-7	Intentional addition / 1,000ppm	chemical products
3003	2-Chloro-1,1-difluoroethane	338-65-8	Intentional addition / 1,000ppm	chemical products
3004	2,3-Dichloro-1,1,1-trifluoropropane	338-75-0	Intentional addition / 1,000ppm	chemical products
3005	Methylum, triphenyl-, tetrafluoroborate(1-)	341-02-6	Intentional addition / 1%	chemical products
3006	1,4-Dibromotetrafluorobenzene	344-03-6	Intentional addition / 1,000ppm	chemical products
3007	1,1'-(Bromomethylene)bis(4-fluorobenzene)	345-90-4	Intentional addition / 1,000ppm	chemical products
3008	2,4-Bis(4-methoxyphenyl)-6-phenylpyrrolum tetrafluoroborate	346-80-5	Intentional addition / 1%	chemical products
3009	Benzene-diazonium, 4-(diethylamino)-, tetrafluoroborate(1-)	347-46-6	Intentional addition / 1%	chemical products
3010	Benzene, 1-chloro-2-fluoro-	348-51-6	Contains (regardless of intentional or impurities)	chemical products
3011	1-Bromo-2,4-difluorobenzene	348-57-2	Intentional addition / 1,000ppm	chemical products
3012	1,4-Dichloro-2-fluorobenzene	348-59-4	Intentional addition / 1,000ppm	chemical products
3013	4-Bromo-1,2-difluorobenzene	348-61-8	Intentional addition / 1,000ppm	chemical products
3014	3-Chloro-4-fluorobenzene	350-30-1	Contains (regardless of intentional or impurities)	chemical products
3015	3,5-Dichlorophenyldiazonium tetrafluoroborate	350-67-4	Intentional addition / 1%	chemical products
3016	Tris(trifluoroacetoxyl)borane	350-70-9	Intentional addition / 1%	chemical products
3017	Fluoroacetate-p-bromoaniline	351-05-3	Contains (regardless of intentional or impurities)	chemical products
3018	Benzene, 1-chloro-4-fluoro-	352-33-0	Contains (regardless of intentional or impurities)	chemical products
3019	Propane, 1-bromo-3-fluoro-	352-91-0	Intentional addition / 100ppm	chemical products
3020	Ethyl fluoride	353-36-6	Contains (regardless of intentional or impurities)	chemical products
3021	Boron trifluoride compound with methyl ether	353-42-4	Contains (regardless of intentional or impurities)	chemical products
3022	Boron trifluoride-dimethyl sulfide complex	353-43-5	Intentional addition / 1%	chemical products
3023	Carbonyl difluoride	353-50-4	Contains (regardless of intentional or impurities)	chemical products
3024	Methane, tribromofluoro-	353-54-8	Intentional addition / 1,000ppm	chemical products
3025	Bromodichlorofluoromethane	353-58-2	Intentional addition / 1,000ppm	chemical products
3026	Chlorodifluoromethane	353-59-3	Contains (regardless of intentional or impurities)	chemical products
3027	1,1,1-Trifluoroiodoethane	353-63-3	Intentional addition / 1,000ppm	chemical products
3028	Ethane, 1,1,2-tetrabromo-2-fluoro-	353-69-5	Intentional addition / 1,000ppm	chemical products
3029	Ethane, 1,1,2-trifluoro-1,2-difluoro-	353-69-5	Intentional addition / 1,000ppm	chemical products
3030	Ethane, 1,2-dibromo-1,2-trifluoro-	353-69-5	Intentional addition / 1,000ppm	chemical products
3031	Ethane, 1-bromo-2-chloro-1,1,2-trifluoro-	354-04-1	Contains (regardless of intentional or impurities)	chemical products
3032	Ethane, 1-bromo-1,1,2-tetrafluoro-	354-06-3	Intentional addition / 1,000ppm	chemical products
3033	1,1,1,2-Tetrachloro-2-fluoroethane	354-07-4	Intentional addition / 1,000ppm	chemical products
3034	Ethane, 1,1,1-trichloro-2,2-difluoro-	354-11-0	Intentional addition / 1,000ppm	chemical products
3035	Ethane, 1,1,2-tetrachloro-1-fluoro-	354-12-1	Intentional addition / 1,000ppm	chemical products
3036	Ethane, 1,2-difluoro-1,1,2-trichloro-	354-13-3	Intentional addition / 1,000ppm	chemical products
3037	Ethane, 2-bromo-1-chloro-1,1,2-trifluoro-	354-15-4	Intentional addition / 1,000ppm	chemical products
3038	1,2,2-Trichloro-1,1-difluoroethane	354-20-1	Intentional addition / 1,000ppm	chemical products
3039	1,2-Dichloro-1,1,2-trifluoroethane	354-21-2	Contains (regardless of intentional or impurities)	chemical products
3040	1-Chloro-1,1,2,2-tetrafluoroethane	354-23-4	Intentional addition / 100ppm	chemical products
3041	Ethane, pentafluoro-	354-25-6	Contains (regardless of intentional or impurities)	chemical products
3042	1,1,1-Tribromo-2,2,2-trifluoroethane	354-33-6	Contains (regardless of intentional or impurities)	chemical products
3043	1,2-Dibromo-1-chloro-1,2,2-trifluoroethane	354-48-3	Intentional addition / 1,000ppm	chemical products
3044	Bromopentafluoroethane	354-51-8	Intentional addition / 1,000ppm	chemical products
3045	Ethane, pentachlorofluoro-	354-55-2	Intentional addition / 1,000ppm	chemical products
3046	1,1,1-trichloro-2,2,2-trifluoroethane	354-56-3	Contains (regardless of intentional or impurities)	chemical products
3047	Ethane, pentafluoroiodo-	354-58-5	Intentional addition / 1,000ppm	chemical products
3048	Ethanesulfonyl fluoride, pentafluoro-	354-64-3	Contains (regardless of intentional or impurities)	chemical products
3049	Butane, decafluoro-	354-67-0	Contains (regardless of intentional or impurities)	chemical products
3050	Trideca-1,1,1,2,2,3,3,4,4,5,5,6,6,6-fluorohexane	355-25-9	Contains (regardless of intentional or impurities)	chemical products
3051	Perfluoro-n-hexane	355-37-3	Contains (regardless of intentional or impurities)	chemical products
3052	1-Cyano-2,2,3,3-tetrafluorocyclobutane	355-42-0	Contains (regardless of intentional or impurities)	chemical products
3053	Zinc cyanide	356-81-0	Intentional addition	chemical products
3054	Brucine	357-21-1	Contains (regardless of intentional or impurities)	chemical products
3055	1,2-Dibromo-1-fluoroethane	357-57-3	Contains (regardless of intentional or impurities)	chemical products
3056	1-Chloro-1,2-difluoroethylene	358-97-4	Contains (regardless of intentional or impurities)	chemical products
3057	Ethane, 2-bromo-1,1-difluoro-	359-04-6	Intentional addition / 1,000ppm	chemical products
3058	Ethane, 2-bromo-1,1-difluoro-	359-07-9	Contains (regardless of intentional or impurities)	chemical products
3059	2-Chloro-1,1-difluoroethylene	359-08-0	Intentional addition / 1,000ppm	chemical products
3060	Ethene, trifluoro-	359-10-4	Intentional addition / 1,000ppm	chemical products
3061	1,1-Dibromo-2,2-difluoroethane	359-11-5	Intentional addition / 100ppm	chemical products
3062	Ethane, 1,1,2-trichloro-2-fluoro-	359-19-3	Intentional addition / 1,000ppm	chemical products
3063	1,1,2,2-Tetrafluoroethane	359-28-4	Contains (regardless of intentional or impurities)	chemical products
3064	2-Amino-5-fluorobenzophenone	359-35-3	Contains (regardless of intentional or impurities)	chemical products
3065	Benzene, pentafluoro-	362-46-9	Intentional addition / 1,000ppm	chemical products
3066	1,4-Difluoro-2-nitrobenzene	363-72-4	Intentional addition / 1,000ppm	chemical products
3067	1-(Chlorophenylmethyl)-4-fluorobenzene	364-74-9	Contains (regardless of intentional or impurities)	chemical products
3068	2-Nitrobenzenediazonium tetrafluoroborate	365-21-9	Intentional addition / 1,000ppm	chemical products
3069	2,2'-Bipyridine	365-33-3	Intentional addition / 1%	chemical products
3070	1,2-Difluorobenzene	366-18-7	Intentional addition / 1%	chemical products
3071	1,2-Trifluorobenzene	367-11-3	Contains (regardless of intentional or impurities)	chemical products
3072	Fluorodimethoxyborane	367-27-3	Intentional addition / 1,000ppm	chemical products
3073	Oxonium, triethyl-, tetrafluoroborate(1-)	367-46-4	Intentional addition / 1%	chemical products
3074	Triethylsulfonium tetrafluoroborate(1-)	368-39-5	Contains (regardless of intentional or impurities)	chemical products
3075	alpha, alpha, alpha-Trifluoro-m-toluonitrile	368-40-1	Intentional addition / 1%	chemical products
3076	1,2-Difluoro-4-nitrobenzene	368-77-4	Intentional addition	chemical products
3077	[1,4-(Trifluoromethoxy)phenyl]hydrazono]malononitrile	369-34-6	Contains (regardless of intentional or impurities)	chemical products
3078	Acetic acid, cyano-	370-86-5	Contains (regardless of intentional or impurities)	chemical products
3079	1,3-Difluorobenzene	372-09-8	Contains (regardless of intentional or impurities)	chemical products
3080	1,3,5-Trifluorobenzene	372-18-9	Contains (regardless of intentional or impurities)	chemical products
3081	Phenol-boron trifluoride	372-38-3	Intentional addition / 1,000ppm	chemical products
3082	Boron, (N-ethylthamamine)trifluoro-, (T-4)-	372-44-1	Contains (regardless of intentional or impurities)	chemical products
3083	Borane, butoxydifluoro-	372-56-5	Intentional addition / 1%	chemical products
3084	Acetic acid, nickel(2+) salt	372-84-9	Intentional addition / 1%	chemical products
3085	Hexane, 1-fluoro-	373-02-4	Contains (regardless of intentional or impurities)	chemical products
3086	Bromofluoromethane	373-14-8	Intentional addition / 1,000ppm	chemical products
3087	Boron, trifluoro(methanamine)-, (T-4)-	373-52-4	Contains (regardless of intentional or impurities)	chemical products
3088	Boron, trifluoro(methanamine)-, (T-4)-	373-56-8	Intentional addition / 1%	chemical products
3089	Borate(1-), bis(acetato-O)difluoro- ditydrogen fluoride, (T-4)-	373-57-9	Intentional addition / 1%	chemical products
3090	Trifluoromethyl hypofluorite	373-61-5	Contains (regardless of intentional or impurities)	chemical products
3091	Ethane, 1,1-dichloro-1,2,2,2-tetrafluoro-	373-91-1	Contains (regardless of intentional or impurities)	chemical products
3092	1-Butanesulfonic acid, 1,1,2,2,3,3,4,4,4-nonafluoro-	374-07-2	Intentional addition / 100ppm	chemical products
3093	1,6-Diiodoperfluorohexane	375-73-5	Intentional addition / 100ppm	chemical products
3094	Tridecane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13-heptacosafuoro-13-iodo-	375-80-4	Intentional addition / 1,000ppm	chemical products
3095	Octanoic acid, penta-decafluoro- methyl ester	376-04-5	Intentional addition / 1,000ppm	chemical products
3096	Stannane, tricyclohexylfluoro-	376-27-2	Contains (regardless of intentional or impurities)	chemical products
3097	Perfluoroisobutylene	379-51-1	Contains (regardless of intentional or impurities)	chemical products
3098	2,6-Dichlorobenzene-diazonium tetrafluoroborate	382-21-8	Contains (regardless of intentional or impurities)	chemical products
3099	2,4-Dichloro-3-fluoronitrobenzene	387-41-7	Intentional addition / 1%	chemical products
3100	Benzenitrile, 2-fluoro-	387-79-3	Contains (regardless of intentional or impurities)	chemical products
3101	2,5-Dichlorobenzene-diazonium tetrafluoroborate	394-47-8	Intentional addition	chemical products
3102	2-Bromo-1,4-difluorobenzene	398-69-6	Intentional addition / 1%	chemical products
3103	4-Amino-3-fluorophenyl	399-94-0	Intentional addition / 1,000ppm	chemical products
3104	1,2,4-Trichloro-5-fluorobenzene	399-95-1	Contains (regardless of intentional or impurities)	chemical products
3105	2,4-Dichloro-5-trifluoromethylnitrobenzene	400-04-4	Intentional addition / 1,000ppm	chemical products
3106	Ethyl bromofluoroacetate	400-70-4	Contains (regardless of intentional or impurities)	chemical products
3107	p-Fluoro-alpha, alpha, alpha-trichlorotoluene	401-55-8	Contains (regardless of intentional or impurities)	chemical products
		402-42-6	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
3108	1-(Dichloromethyl)-3-fluorobenzene	402-64-2	Intentional addition / 1,000ppm	chemical products
3109	Benzonitrile, 3-fluoro-	403-54-3	Intentional addition	chemical products
3110	Butane, 1,1,1,3,3-pentafluoro-	406-58-6	Contains (regardless of intentional or impurities)	chemical products
3111	Silicon carbide	409-21-2	Contains (regardless of intentional or impurities)	chemical products
3112	Cyanamide	420-04-2	Contains (regardless of intentional or impurities)	chemical products
3113	Arsine, difluoromethyl-	420-24-6	Contains (regardless of intentional or impurities)	chemical products
3114	Propane, 2-fluoro-	420-26-8	Contains (regardless of intentional or impurities)	chemical products
3115	Oxonium, trimethyl-, tetrafluoroborate(1-)	420-37-1	Intentional addition / 1%	chemical products
3116	Ethane, 1-bromo-1,1-difluoro-	420-43-9	Intentional addition	chemical products
3117	2-chloro-2-fluoropropane	420-44-0	Intentional addition / 1,000ppm	chemical products
3118	2,2-Difluoropropane	420-44-1	Intentional addition / 1,000ppm	chemical products
3119	Ethane, 1,1,1-trifluoro-	420-46-2	Contains (regardless of intentional or impurities)	chemical products
3120	1-Bromo-1,1,1-difluoroethane	420-47-3	Contains (regardless of intentional or impurities)	chemical products
3121	Ethane, 1,1,2-tribromo-1-fluoro-	420-88-2	Intentional addition / 1,000ppm	chemical products
3122	Propane, 1-bromo-1,1-difluoro-	420-89-3	Intentional addition / 1,000ppm	chemical products
3123	1,2-Dichloro-2-fluoropropane	420-97-3	Intentional addition / 1,000ppm	chemical products
3124	Propane, 1-bromo-2,2-difluoro-	420-98-4	Intentional addition / 1,000ppm	chemical products
3125	1-Chloro-2,2-difluoropropane	420-99-5	Intentional addition / 1,000ppm	chemical products
3126	1-Chloro-1,1-difluoropropane	421-02-3	Intentional addition / 1,000ppm	chemical products
3127	Ethane, 1-chloro-1,1,2-trifluoro-	421-04-5	Intentional addition / 1,000ppm	chemical products
3128	2-Bromo-1,1,1-trifluoroethane	421-06-7	Contains (regardless of intentional or impurities)	chemical products
3129	Propane, 1,1,1-trifluoro-	421-07-8	Intentional addition / 1,000ppm	chemical products
3130	1,1,2-Trichloro-1-fluoropropane	421-41-0	Intentional addition / 1,000ppm	chemical products
3131	Propane, 2-bromo-1,1,1-trifluoro-	421-46-5	Contains (regardless of intentional or impurities)	chemical products
3132	2-Chloro-1,1,1-trifluoropropane	421-47-6	Intentional addition	chemical products
3133	Propane, 1-chloro-1,1,2,2-tetrafluoro-	421-75-0	Intentional addition / 1,000ppm	chemical products
3134	Propane, 2,2,3-tribromo-1,1,1-trifluoro-	421-90-9	Intentional addition / 1,000ppm	chemical products
3135	Propane, 2,3-dibromo-1,1,2-tetrafluoro-	421-92-1	Intentional addition / 1,000ppm	chemical products
3136	1,1,1,2,3-Pentachloro-2-fluoropropane	421-94-3	Intentional addition / 1,000ppm	chemical products
3137	1,1,3-Trichloro-1,2,2-trifluoropropane	421-99-8	Intentional addition	chemical products
3138	Propane, 1,3-dichloro-1,2,2-tetrafluoro-	422-00-4	Intentional addition	chemical products
3139	Propane, 3-bromo-1,1,1,2,2-pentafluoro-	422-01-5	Intentional addition / 1,000ppm	chemical products
3140	Propane, 3-chloro-1,1,1,2,2-pentafluoro-	422-02-6	Intentional addition / 1,000ppm	chemical products
3141	1,1,1,2,2,3-Hexachloro-3-fluoropropane	422-26-4	Intentional addition / 1,000ppm	chemical products
3142	1,2,2,3,3-Pentachloro-1,1-difluoropropane	422-30-0	Intentional addition / 1,000ppm	chemical products
3143	1,1,1,2,3,3-Hexachloro-2-fluoropropane	422-40-2	Intentional addition	chemical products
3144	1,2-Dichloro-1,1,2,3,3-pentafluoropropane	422-44-6	Intentional addition / 1,000ppm	chemical products
3145	2,3-Dichloro-1,1,1,2,3-pentafluoropropane	422-48-0	Intentional addition / 1,000ppm	chemical products
3146	1,1,1,3,3-Pentachloro-2,2-difluoropropane	422-49-1	Intentional addition / 1,000ppm	chemical products
3147	1,1,1,3-Tetrachloro-2,2,3-trifluoropropane	422-50-4	Intentional addition / 1,000ppm	chemical products
3148	2,2,3,3-Tetrafluoro-1,1,1-trichloropropane	422-51-5	Intentional addition / 1,000ppm	chemical products
3149	1,1,3,3-Tetrachloro-1,2,2-trifluoropropane	422-52-6	Contains (regardless of intentional or impurities)	chemical products
3150	1,1,3-Trichloro-1,2,2,3-tetrafluoropropane	422-53-7	Contains (regardless of intentional or impurities)	chemical products
3151	1,3,3-Trichloro-1,1,2,2-tetrafluoropropane	422-54-8	Intentional addition / 1,000ppm	chemical products
3152	1-Chloro-1,1,2,2,3,3-hexafluoropropane	422-55-9	Intentional addition / 1,000ppm	chemical products
3153	3,3-Dichloro-1,1,1,2,2-pentafluoropropane	422-56-0	Intentional addition / 1,000ppm	chemical products
3154	3-Chloro-1,1,1,2,2,3-hexafluoropropane	422-57-1	Intentional addition	chemical products
3155	1,1,1,2,2,3,3-Heptachloro-3-fluoropropane	422-78-6	Contains (regardless of intentional or impurities)	chemical products
3156	Propane, 1,1,1,2,3,3,3-heptachloro-2-fluoro-	422-81-1	Intentional addition	chemical products
3157	Propane, 1-chloro-1,1,2,2,3,3,3-heptafluoro-	422-86-6	Contains (regardless of intentional or impurities)	chemical products
3158	Decane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10-heneicosafuoro-10-iodo-	423-62-1	Contains (regardless of intentional or impurities)	chemical products
3159	1,2-Dichloro-1,2,3,3-tetrafluoropropane	423-94-5	Intentional addition / 1,000ppm	chemical products
3160	Tetraethylphosphonium tetrafluoroborate	426-79-9	Intentional addition / 1%	chemical products
3161	Tetraethylammonium tetrafluoroborate	429-06-1	Intentional addition / 1%	chemical products
3162	Triethyltin trifluoroacetate	429-30-1	Contains (regardless of intentional or impurities)	chemical products
3163	1-Butanaminium, N,N,N-tributyl-, tetrafluoroborate(1-)	429-45-5	Intentional addition / 1%	chemical products
3164	Tribenzylfluorostannane	429-77-6	Contains (regardless of intentional or impurities)	chemical products
3165	1-Chloro-2-fluoropropane	430-46-6	Intentional addition	chemical products
3166	1,1-Dichloro-2-fluoroethane	430-59-5	Intentional addition / 1,000ppm	chemical products
3167	1-Chloro-1-fluoropropane	430-55-7	Intentional addition / 1,000ppm	chemical products
3168	1,2-Dichloro-1-fluoroethane	430-57-9	Intentional addition / 1,000ppm	chemical products
3169	1,2-Dichloro-1-fluoroethylene	430-58-0	Intentional addition / 1,000ppm	chemical products
3170	1,1,2-Trifluoroethane	430-68-0	Contains (regardless of intentional or impurities)	chemical products
3171	1,1-Dibromo-2,2-difluoroethylene	430-85-3	Intentional addition / 1,000ppm	chemical products
3172	Propane, 2-bromo-1,1-difluoro-	430-87-5	Intentional addition / 1,000ppm	chemical products
3173	2-Chloro-1,1-difluoropropane	430-93-3	Intentional addition / 1,000ppm	chemical products
3174	2,3-Butanedione	431-03-8	Contains (regardless of intentional or impurities)	chemical products
3175	1,2-Dichloro-1,2-difluoroethane	431-06-1	Intentional addition / 1,000ppm	chemical products
3176	Ethane, 1-chloro-1,2,2-trifluoro-	431-07-2	Intentional addition / 1,000ppm	chemical products
3177	Propane, 2,3-dibromo-1,1,1-trifluoro-	431-21-0	Contains (regardless of intentional or impurities)	chemical products
3178	Propane, 2,3,3-tribromo-1,1,1-trifluoro-	431-48-1	Intentional addition / 1,000ppm	chemical products
3179	1,1,1,2-Trichloro-3,3,3-trifluoropropane	431-52-7	Intentional addition / 1,000ppm	chemical products
3180	1,1,1,2,3,3-Hexafluoropropane	431-63-0	Contains (regardless of intentional or impurities)	chemical products
3181	Propane, 1,2-dibromo-1,1,3,3,3-pentafluoro-	431-78-7	Contains (regardless of intentional or impurities)	chemical products
3182	1,1,1,2,3,3-Hexachloro-3-fluoropropane	431-79-8	Intentional addition	chemical products
3183	1,1,1,2-Tetrachloro-3,3,3-trifluoropropane	431-81-2	Intentional addition	chemical products
3184	1,1,2,3,3-Pentachloro-1,3-difluoropropane	431-82-3	Intentional addition	chemical products
3185	1,1,2,3-Tetrachloro-1,3,3-trifluoropropane	431-83-4	Intentional addition / 1,000ppm	chemical products
3186	1,2-Dichloro-1,1,3,3,3-pentafluoropropane	431-86-7	Intentional addition / 1,000ppm	chemical products
3187	2-Chloro-1,1,1,3,3,3-hexafluoropropane	431-87-8	Intentional addition / 1,000ppm	chemical products
3188	Propane, 1,3-dibromo-1,1,2,3,3-pentafluoro-	431-88-9	Intentional addition / 1,000ppm	chemical products
3189	Propane, 1,1,1,2,3,3,3-heptafluoro-	431-89-0	Contains (regardless of intentional or impurities)	chemical products
3190	Dimethylfluoroborane	436-59-9	Intentional addition / 1%	chemical products
3191	Triphenylsulfonium tetrafluoroborate	437-13-8	Intentional addition / 1%	chemical products
3192	Methylum, triphenyl-, hexafluoroarsenate(1-)	437-15-0	Contains (regardless of intentional or impurities)	chemical products
3193	Benzene, 2,4-difluoro-1-nitro-	446-35-5	Contains (regardless of intentional or impurities)	chemical products
3194	3-Chloro-2-methylbenzenediazonium tetrafluoroborate	446-55-9	Intentional addition / 1%	chemical products
3195	alpha_alpha_alpha-Trifluoro-2-toluonitrile	447-60-9	Intentional addition	chemical products
3196	1-Nitro-2-methoxy-4-fluorobenzene	448-19-1	Contains (regardless of intentional or impurities)	chemical products
3197	2,4,6-Triphenylpyrylium tetrafluoroborate	448-61-3	Intentional addition / 1%	chemical products
3198	1,2-Dibromo-3-fluoropropane	453-00-9	Intentional addition / 1,000ppm	chemical products
3199	1,2-Dichloro-3-fluoropropane	453-01-0	Intentional addition	chemical products
3200	Benzenamine, 4-(trifluoromethyl)-	455-14-1	Contains (regardless of intentional or impurities)	chemical products
3201	Benzonitrile, 4-(trifluoromethyl)-	455-18-5	Intentional addition	chemical products
3202	Benzenediazonium, 2-methyl-4-nitro-, tetrafluoroborate(1-)	455-90-3	Intentional addition / 1%	chemical products
3203	1-(Dichloromethyl)-4-fluorobenzene	456-19-9	Contains (regardless of intentional or impurities)	chemical products
3204	Benzenediazonium, 4-nitro-, tetrafluoroborate(1-)	456-27-9	Contains (regardless of intentional or impurities)	chemical products
3205	Benzenediazonium, 3-chloro-, tetrafluoroborate(1-)	456-39-3	Intentional addition / 1%	chemical products
3206	Benzene, 1-(bromomethyl)-3-fluoro-	456-41-7	Intentional addition / 1,000ppm	chemical products
3207	Neosphenamine	457-60-3	Contains (regardless of intentional or impurities)	chemical products
3208	Benzeneacetoneitrile, 4-fluoro-	457-22-3	Contains (regardless of intentional or impurities)	chemical products
3209	Benzenediazonium, 4-methyl-, tetrafluoroborate(1-)	459-44-9	Intentional addition / 1%	chemical products
3210	4-Methoxybenzenediazonium tetrafluoroborate	459-64-3	Intentional addition / 1%	chemical products
3211	Benzene, 1-bromo-4-fluoro-	460-00-4	Intentional addition / 1,000ppm	chemical products
3212	1-Fluoropropane	460-13-9	Contains (regardless of intentional or impurities)	chemical products
3213	1-Chloro-2-fluoroethylene	460-18-2	Intentional addition / 1,000ppm	chemical products
3214	Ethanedinitrile	460-19-5	Contains (regardless of intentional or impurities)	chemical products
3215	Propane, 1,3-dibromo-1,1-difluoro-	460-25-3	Contains (regardless of intentional or impurities)	chemical products
3216	Propane, 3-bromo-1,1,1-trifluoro-	460-32-2	Intentional addition / 100ppm	chemical products
3217	3-Chloro-1,1,1-trifluoropropane	460-35-5	Intentional addition / 1,000ppm	chemical products
3218	1-Iodo-3,3,3-trifluoropropane	460-37-7	Intentional addition / 1,000ppm	chemical products
3219	Propane, 1,3-dibromo-1,1,3-trifluoro-	460-60-6	Intentional addition / 1,000ppm	chemical products
3220	Trichlorodifluoropropane	460-63-9	Intentional addition / 1,000ppm	chemical products
3221	Propane, 3-bromo-1,1,1,3-tetrafluoro-	460-67-3	Intentional addition / 1,000ppm	chemical products
3222	3,3-Dichloro-1,1,1-trifluoropropane	460-69-5	Intentional addition / 1,000ppm	chemical products
3223	1-Propene, 1,1-dichloro-3,3,3-trifluoro-	460-70-8	Contains (regardless of intentional or impurities)	chemical products
3224	1,1,1,3,3-Pentafluoropropane	460-73-1	Contains (regardless of intentional or impurities)	chemical products
3225	Propane, 1,3-dibromo-1,1,3,3-tetrafluoro-	460-86-6	Intentional addition / 100ppm	chemical products
3226	Propane, 1-bromo-1,1,3,3,3-pentafluoro-	460-88-8	Contains (regardless of intentional or impurities)	chemical products
3227	1,1,1,3-Tetrachloro-3,3-difluoropropane	460-89-9	Intentional addition / 1,000ppm	chemical products
3228	Propane, 1-chloro-1,1,3,3,3-pentafluoro-	460-92-4	Contains (regardless of intentional or impurities)	chemical products
3229	Alkyl(C1-2) alkyl(C1-4) carboxylate complex salt of boron trifluoride	461-44-9	Contains (regardless of intentional or impurities)	chemical products
3230	Propane, 3-bromo-1,1-difluoro-	461-49-4	Intentional addition / 1,000ppm	chemical products
3231	1-Bromo-3,5-difluorobenzene	461-96-1	Contains (regardless of intentional or impurities)	chemical products
3232	Boron trifluoride-phenol complex (1:2)	462-05-5	Intentional addition / 1%	chemical products
3233	Fluorobenzene	462-06-6	Contains (regardless of intentional or impurities)	chemical products
3234	Borane, dibutoxyfluoro-	462-19-1	Intentional addition / 1%	chemical products
3235	Formic acid, ethyl ester, compound with trifluoroborane (1:1)	462-33-9	Intentional addition / 1%	chemical products
3236	Boron, trifluoro(tetrahydrofuran)-, (T-4)	462-34-0	Intentional addition / 1%	chemical products
3237	1,3-Difluoropropane	462-39-5	Intentional addition / 1,000ppm	chemical products
3238	n-Amyl nitrite	463-04-7	Contains (regardless of intentional or impurities)	chemical products
3239	1-Fluorooctane	463-11-6	Intentional addition / 1,000ppm	chemical products
3240	ketene	463-51-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
3241	Carbonyl sulfide	463-58-1	Contains (regardless of intentional or impurities)	chemical products
3242	Propane, 2,2-dimethyl-	463-82-1	Contains (regardless of intentional or impurities)	chemical products
3243	Butane, 2,2,3-trimethyl-	464-06-2	Contains (regardless of intentional or impurities)	chemical products
3244	Strychnidin-10-one, 2,2'-difluoro-6,6'-dimethoxy[1,1'-biphenyl]-3,3'-dicarboxylate (1:1)	466-68-2	Contains (regardless of intentional or impurities)	chemical products
3245	Chlorfenvinphos	470-90-6	Contains (regardless of intentional or impurities)	chemical products
3246	Tetramethyldiarsine	471-35-2	Contains (regardless of intentional or impurities)	chemical products
3247	Ethane, 1,1-dichloro-2,2-difluoro-	471-43-2	Intentional addition / 1,000ppm	chemical products
3248	Phenazinium, 3,7-diamino-2,8-dimethyl-5-phenyl-, chloride	477-73-6	Contains (regardless of intentional or impurities)	chemical products
3249	1,8-Naphthalenediamine	478-27-6	Contains (regardless of intentional or impurities)	chemical products
3250	Tetryl	478-45-8	Contains (regardless of intentional or impurities)	chemical products
3251	1H,5H-Benzo[ <i>l</i> ]quinolizine, 2,3,6,7-tetrahydro-	478-59-4	Intentional addition / 1%	chemical products
3252	Binapacryl	485-31-4	Contains (regardless of intentional or impurities)	chemical products
3253	Mersalyl acid	486-67-9	Contains (regardless of intentional or impurities)	chemical products
3254	Mersalyl	492-18-2	Contains (regardless of intentional or impurities)	chemical products
3255	Auramine	492-80-5	Contains (regardless of intentional or impurities)	chemical products
3256	Anabasine	494-52-0	Intentional addition / 1%	chemical products
3257	Melarsoprol	494-79-1	Contains (regardless of intentional or impurities)	chemical products
3258	1,2-Benzenediamine, 4-methyl-	496-72-0	Intentional addition / 1%	chemical products
3259	3,5-Dinitro- <i>o</i> -cresol	497-58-3	Intentional addition	chemical products
3260	Mercurobutyl	498-73-7	Contains (regardless of intentional or impurities)	chemical products
3261	Benzeneacetonitrile, 3-fluoro-	501-00-8	Contains (regardless of intentional or impurities)	chemical products
3262	Methyl mercury dicyandiamide	502-39-6	Contains (regardless of intentional or impurities)	chemical products
3263	Fluoroacetonitrile	503-20-8	Contains (regardless of intentional or impurities)	chemical products
3264	Arsine, oxybis(dimethyl)-	503-80-0	Contains (regardless of intentional or impurities)	chemical products
3265	2-Aminopyridine	504-29-0	Contains (regardless of intentional or impurities)	chemical products
3266	Pyridinium tetrafluoroborate	505-07-7	Intentional addition / 1%	chemical products
3267	1-Hexadecen-3-ol, 3,7,11,15-tetramethyl-	505-32-8	Intentional addition / 1%	chemical products
3268	Mustard gas	505-60-2	Contains (regardless of intentional or impurities)	chemical products
3269	Potassium silver cyanide	506-61-6	Contains (regardless of intentional or impurities)	chemical products
3270	Dimethylberyllium	506-63-8	Contains (regardless of intentional or impurities)	chemical products
3271	Silver cyanide	506-64-9	Contains (regardless of intentional or impurities)	chemical products
3272	Gold cyanide (Au(CN))	506-65-0	Contains (regardless of intentional or impurities)	chemical products
3273	Beryllium carbide (Be <sub>2</sub> C)	506-66-1	Contains (regardless of intentional or impurities)	chemical products
3274	Cyanogen bromide ((CN)Br)	506-68-3	Contains (regardless of intentional or impurities)	chemical products
3275	Cyanogen chloride ((CN)Cl)	506-77-4	Contains (regardless of intentional or impurities)	chemical products
3276	Cyanogen iodide	506-78-5	Contains (regardless of intentional or impurities)	chemical products
3277	Carbon selenide (CSe <sub>2</sub> )	506-80-9	Contains (regardless of intentional or impurities)	chemical products
3278	Dimethylcadmium	506-82-1	Contains (regardless of intentional or impurities)	chemical products
3279	Acetyl iodide	507-02-8	Contains (regardless of intentional or impurities)	chemical products
3280	2-Bromo-2-methylpropane	507-19-7	Contains (regardless of intentional or impurities)	chemical products
3281	Tetraphenylarsonium bromide	507-27-7	Contains (regardless of intentional or impurities)	chemical products
3282	Arsonium, tetraphenyl-, chloride	507-28-8	Contains (regardless of intentional or impurities)	chemical products
3283	Butane, 2-bromo-2-methyl-	507-36-8	Intentional addition / 1,000ppm	chemical products
3284	1,3-Dichloro-1,1,2,2,3-pentafluoropropane	507-55-1	Intentional addition / 1,000ppm	chemical products
3285	Octane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8-heptafluoro-8-iodo-	507-63-1	Contains (regardless of intentional or impurities)	chemical products
3286	Propane, 1,2-dibromo-1,2,3,3-tetrafluoro-	508-46-3	Intentional addition / 1,000ppm	chemical products
3287	Tetranitromethane	509-14-8	Contains (regardless of intentional or impurities)	chemical products
3288	Strychnine phosphate	509-42-2	Contains (regardless of intentional or impurities)	chemical products
3289	Tribarium dicitrate	512-25-4	Contains (regardless of intentional or impurities)	chemical products
3290	Trimethyl phosphate	512-56-1	Contains (regardless of intentional or impurities)	chemical products
3291	1-Propene, 2,3-dibromo-	513-31-5	Intentional addition / 1,000ppm	chemical products
3292	1-Iodo-2-methylpropane	513-38-2	Contains (regardless of intentional or impurities)	chemical products
3293	Butane, 2-iodo-	513-48-4	Contains (regardless of intentional or impurities)	chemical products
3294	Barium carbonate	513-77-9	Contains (regardless of intentional or impurities)	chemical products
3295	Urea oxalate	513-80-4	Intentional addition / 1,000ppm	chemical products
3296	Barium di(benzenesulphonate)	515-72-0	Contains (regardless of intentional or impurities)	chemical products
3297	Diflutarane disodium	515-76-4	Contains (regardless of intentional or impurities)	chemical products
3298	Ethanedioic acid, barium salt (1:1)	516-02-9	Intentional addition / 1,000ppm	chemical products
3299	Iron, [ethanedioato(2-)-O]2-	516-03-0	Intentional addition / 1,000ppm	chemical products
3300	Trisodium 2-(hydrogen arsonatophenylazo)-1,8-dihydroxynaphthalene-3,6-disulphonate	520-10-5	Contains (regardless of intentional or impurities)	chemical products
3301	(2-Aminoethoxy)(diphenyl)borane	524-95-8	Intentional addition / 1%	chemical products
3302	Mercuramide	525-30-4	Contains (regardless of intentional or impurities)	chemical products
3303	Fluorene-2,7-diyldiamine	525-64-4	Intentional addition / 100ppm	chemical products
3304	Pentasodium [4,5-dihydroxybenzene-1,3-disulphonato(2-)-O,05][4,5-dihydroxybenzene-1,3-disulphonato(1-)-O,0]antimony	526-50-1	Contains (regardless of intentional or impurities)	chemical products
3305	1,2,3-Trimethylbenzene	526-73-8	Contains (regardless of intentional or impurities)	chemical products
3306	Cupric gluconate	527-09-3	Intentional addition / 1,000ppm	chemical products
3307	2-Furancarboxyl chloride	527-69-5	Contains (regardless of intentional or impurities)	chemical products
3308	1,2-Dinitrobenzene	528-29-0	Contains (regardless of intentional or impurities)	chemical products
3309	Benzonitrile, 2-methyl-	529-19-1	Contains (regardless of intentional or impurities)	chemical products
3310	[1,1'-Biphenyl]-3,3',5,5'-tetrol	531-02-2	Intentional addition / 1%	chemical products
3311	Thiacetarsamide	531-72-6	Contains (regardless of intentional or impurities)	chemical products
3312	Merphalan	531-76-0	Contains (regardless of intentional or impurities)	chemical products
3313	Benzidine dihydrochloride	531-85-1	Contains (regardless of intentional or impurities)	chemical products
3314	Benzidine sulfate (1:1)	531-86-2	Contains (regardless of intentional or impurities)	chemical products
3315	Ethanone, 2-chloro-1-phenyl-	532-27-4	Contains (regardless of intentional or impurities)	chemical products
3316	Mandelonitrile	532-28-5	Contains (regardless of intentional or impurities)	chemical products
3317	Benzoic acid, barium salt	533-00-6	Contains (regardless of intentional or impurities)	chemical products
3318	Benzoic acid, copper(2+) salt	533-01-7	Intentional addition / 1,000ppm	chemical products
3319	Ethanedioic acid, disilver(1+) salt	533-51-7	Intentional addition / 1,000ppm	chemical products
3320	Tetrahydro-3,5-dimethyl-2H-1,3,5-thiadiazine-2-thione	533-74-4	Contains (regardless of intentional or impurities)	chemical products
3321	Carbonic acid, sodium salt (2:3)	533-96-0	Intentional addition / 1%	chemical products
3322	Butane, 1,2-dibromo-	533-98-2	Intentional addition / 1,000ppm	chemical products
3323	Butane, 1-bromo-2-methyl-, (S)-	534-00-9	Intentional addition / 1,000ppm	chemical products
3324	Carbonic acid, disilver(1+) salt	534-16-7	Intentional addition / 25%	chemical products
3325	Acetarsone diethylamine salt	534-33-8	Contains (regardless of intentional or impurities)	chemical products
3326	4,6-Dinitro- <i>o</i> -cresol	534-52-1	Contains (regardless of intentional or impurities)	chemical products
3327	1,2-Benzenediamine, N-phenyl-	534-85-0	Contains (regardless of intentional or impurities)	chemical products
3328	Gold tricyanide	535-37-5	Contains (regardless of intentional or impurities)	chemical products
3329	Benzoic acid, 3,5-diamino-	535-87-5	Contains (regardless of intentional or impurities)	chemical products
3330	Lanthanum, [mu-]ethanedioato(2-)-O,0''O,0''O]]bis[ethanedioato(2-)-O,0''O]]di-	537-03-1	Intentional addition	chemical products
3331	Oxophenarsine hydrochloride	538-03-4	Contains (regardless of intentional or impurities)	chemical products
3332	Propanoic acid, 3-bromo-, ethyl ester	539-74-2	Contains (regardless of intentional or impurities)	chemical products
3333	Copper dibutyrate	540-16-9	Intentional addition / 1,000ppm	chemical products
3334	Benzenamine, 4-methyl-, hydrochloride	540-23-8	Contains (regardless of intentional or impurities)	chemical products
3335	β-Toluidine sulphate (1:1)	540-25-0	Contains (regardless of intentional or impurities)	chemical products
3336	1,4-Difluorobenzene	540-36-3	Contains (regardless of intentional or impurities)	chemical products
3337	Ethene, 1,2-dichloro-	540-59-0	Contains (regardless of intentional or impurities)	chemical products
3338	Aminoacetonitrile	540-61-4	Intentional addition	chemical products
3339	1,2-Dimethylhydrazine	540-75-8	Contains (regardless of intentional or impurities)	chemical products
3340	Choline borate	540-80-0	Intentional addition / 1%	chemical products
3341	tert-Butyl nitrite	540-80-7	Contains (regardless of intentional or impurities)	chemical products
3342	2,2,4-Trimethylpentane	540-84-1	Contains (regardless of intentional or impurities)	chemical products
3343	tert-Butyl acetate	540-88-5	Contains (regardless of intentional or impurities)	chemical products
3344	Uranyl acetate	541-09-3	Contains (regardless of intentional or impurities)	chemical products
3345	Lewisite	541-25-3	Contains (regardless of intentional or impurities)	chemical products
3346	Butane, 1-iodo-3-methyl-	541-28-6	Contains (regardless of intentional or impurities)	chemical products
3347	Butane, 1,1-dichloro-	541-33-3	Intentional addition / 1,000ppm	chemical products
3348	Nitrous acid, 1-methylethyl ester	541-42-4	Contains (regardless of intentional or impurities)	chemical products
3349	Barium diformate	541-43-5	Contains (regardless of intentional or impurities)	chemical products
3350	1,3-Benzenediamine, dihydrochloride	541-69-5	Contains (regardless of intentional or impurities)	chemical products
3351	1,3-Benzenediamine, sulfate (1:1)	541-70-8	Contains (regardless of intentional or impurities)	chemical products
3352	1,3-Dichlorobenzene	541-73-1	Contains (regardless of intentional or impurities)	chemical products
3353	5-Methyl-3-heptanone	541-85-5	Contains (regardless of intentional or impurities)	chemical products
3354	Benzenamine, hydrobromide	542-11-0	Contains (regardless of intentional or impurities)	chemical products
3355	Benzenamine, acetate	542-14-3	Contains (regardless of intentional or impurities)	chemical products
3356	Anilinium nitrate	542-15-4	Contains (regardless of intentional or impurities)	chemical products
3357	Benzenamine, sulfate (2:1)	542-16-5	Contains (regardless of intentional or impurities)	chemical products
3358	Pentanenitrile, 4-methyl-	542-54-1	Contains (regardless of intentional or impurities)	chemical products
3359	Isobutyl nitrite	542-56-3	Contains (regardless of intentional or impurities)	chemical products
3360	Barium cyanide	542-62-1	Contains (regardless of intentional or impurities)	chemical products
3361	Diethylberyllium	542-63-2	Contains (regardless of intentional or impurities)	chemical products
3362	1-Iodobutane	542-69-8	Contains (regardless of intentional or impurities)	chemical products
3363	1,3-Dichloropropene	542-75-6	Contains (regardless of intentional or impurities)	chemical products
3364	3-Chloropropionitrile	542-76-7	Contains (regardless of intentional or impurities)	chemical products
3365	Cadmium cyanide (Cd(CN) <sub>2</sub> )	542-83-6	Contains (regardless of intentional or impurities)	chemical products
3366	Cobalt cyanide (Co(CN) <sub>2</sub> )	542-84-7	Contains (regardless of intentional or impurities)	chemical products
3367	Bis(chloromethyl) ether	542-88-1	Contains (regardless of intentional or impurities)	chemical products
3368	Cyclopentadiene	542-92-7	Contains (regardless of intentional or impurities)	chemical products
3369	2-Butylenediamide	543-21-5	Intentional addition / 1%	chemical products
3370	n-Amyl chloride	543-59-9	Contains (regardless of intentional or impurities)	chemical products
3371	Propyl nitrite	543-67-9	Contains (regardless of intentional or impurities)	chemical products
3372	Barium acetate	543-80-6	Contains (regardless of intentional or impurities)	chemical products
3373	Beryllium di(acetate)	543-81-7	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
3374	Cadmium acetate	543-90-8	Contains (regardless of intentional or impurities)	chemical products
3375	1-Chlorohexane	544-10-5	Contains (regardless of intentional or impurities)	chemical products
3376	Pentanedinitrile	544-13-8	Contains (regardless of intentional or impurities)	chemical products
3377	Butyl nitrite	544-16-1	Contains (regardless of intentional or impurities)	chemical products
3378	Cobaltous formate	544-18-3	Intentional addition / 1%	chemical products
3379	Formic acid, copper(2+) salt	544-19-4	Intentional addition / 1,000ppm	chemical products
3380	Copper(I) cyanide	544-92-3	Contains (regardless of intentional or impurities)	chemical products
3381	Trichloroacetone	545-06-2	Contains (regardless of intentional or impurities)	chemical products
3382	Tris(1-aziridinyl)phosphine oxide	545-55-1	Contains (regardless of intentional or impurities)	chemical products
3383	Acetic acid, lead(4+) salt	546-67-8	Contains (regardless of intentional or impurities)	chemical products
3384	Copper bis(ρ-hydroxybenzenesulfonate)	547-56-8	Intentional addition / 1,000ppm	chemical products
3385	Magnesium, [ethanedioate(2-)+O,O]-	547-66-0	Intentional addition / 1,000ppm	chemical products
3386	Ethanedioic acid, nickel(2+) salt (1:1)	547-67-1	Contains (regardless of intentional or impurities)	chemical products
3387	Ethanedioic acid, zinc salt (1:1)	547-68-2	Contains (regardless of intentional or impurities)	chemical products
3388	Tris[(8.alpha.)9R]-6'-methoxycinchonan-9-ol] bis(arsenate)	549-59-7	Contains (regardless of intentional or impurities)	chemical products
3389	1,2,3,4-Tetrafluorobenzene	551-62-2	Intentional addition / 1,000ppm	chemical products
3390	1-Naphthalenamine, hydrochloride	552-46-5	Contains (regardless of intentional or impurities)	chemical products
3391	Benzaldehyde, 2-nitro-	552-89-6	Contains (regardless of intentional or impurities)	chemical products
3392	2-Naphthylammonium acetate	553-00-4	Contains (regardless of intentional or impurities)	chemical products
3393	Nickel dibenzate	553-71-9	Contains (regardless of intentional or impurities)	chemical products
3394	Ethanedioic acid, dilithium salt	553-91-3	Intentional addition / 1,000ppm	chemical products
3395	Benzenamine, 2,4-dichloro-	554-00-7	Contains (regardless of intentional or impurities)	chemical products
3396	Trypsinamide	554-72-3	Contains (regardless of intentional or impurities)	chemical products
3397	Stibanic acid	554-76-7	Contains (regardless of intentional or impurities)	chemical products
3398	Benzeneacetonitrile, 4-nitro-	555-21-5	Contains (regardless of intentional or impurities)	chemical products
3399	Ethanedioic acid, iron(3+) sodium salt (3:1:3)	555-34-0	Intentional addition / 1,000ppm	chemical products
3400	Octadecanoic acid, iron(3+) salt	555-36-2	Intentional addition / 1%	chemical products
3401	Propanedinitrile, [(3-chlorophenyl)hydrazono]-	555-60-2	Contains (regardless of intentional or impurities)	chemical products
3402	Iron trifromate	555-76-0	Intentional addition / 1%	chemical products
3403	Carbonic acid, yttrium(3+) salt (3:2)	556-28-5	Intentional addition / 1%	chemical products
3404	Glycidol	556-52-5	Contains (regardless of intentional or impurities)	chemical products
3405	Allyl iodide	556-56-9	Contains (regardless of intentional or impurities)	chemical products
3406	Methyl isothiocyanate	556-61-6	Contains (regardless of intentional or impurities)	chemical products
3407	Magnesium stearate	557-04-0	Intentional addition / 1%	chemical products
3408	Zinc stearate	557-05-1	Contains (regardless of intentional or impurities)	chemical products
3409	Dipotassium tetrakis(cyano-C)zincate	557-13-1	Contains (regardless of intentional or impurities)	chemical products
3410	Nickel cyanide	557-19-7	Contains (regardless of intentional or impurities)	chemical products
3411	Zinc cyanide	557-21-1	Contains (regardless of intentional or impurities)	chemical products
3412	Zinc acetate	557-34-6	Intentional addition / 1%	chemical products
3413	Octane, 2-bromo-	557-35-7	Intentional addition / 1,000ppm	chemical products
3414	Thiocyanic acid, zinc salt	557-42-6	Intentional addition / 1,000ppm	chemical products
3415	Chlorodimethylarsine	557-89-1	Contains (regardless of intentional or impurities)	chemical products
3416	Ethane, 1,1-dibromo-	557-91-5	Intentional addition / 1,000ppm	chemical products
3417	1-Propene, 2-bromo-	557-93-7	Intentional addition / 1,000ppm	chemical products
3418	Diiodobromomethane	557-95-9	Intentional addition / 1,000ppm	chemical products
3419	2-Chloropropene	557-98-2	Contains (regardless of intentional or impurities)	chemical products
3420	Carbon tetrabromide	558-13-4	Contains (regardless of intentional or impurities)	chemical products
3421	2-Iodo-2-methylpropane	558-17-8	Contains (regardless of intentional or impurities)	chemical products
3422	Arsenic, trichlorodimethyl-	558-31-6	Contains (regardless of intentional or impurities)	chemical products
3423	Nonane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9-nonadecafluoro-9-iodo-	558-97-4	Contains (regardless of intentional or impurities)	chemical products
3424	Pentane, 2,3,3-trimethyl-	560-21-4	Contains (regardless of intentional or impurities)	chemical products
3425	3,3-Dimethylpentane	562-49-2	Contains (regardless of intentional or impurities)	chemical products
3426	Platinate(2-), tetrakis(cyano-C)-, dipotassium, (SP-4-1)-	562-76-5	Contains (regardless of intentional or impurities)	chemical products
3427	Diammonium tetracyanoplatinate	562-79-8	Contains (regardless of intentional or impurities)	chemical products
3428	Platinate(2-), tetrakis(cyano-C)-, barium (1:1), (SP-4-1)-	562-81-2	Contains (regardless of intentional or impurities)	chemical products
3429	Phosphoric acid, tris(3-methylphenyl) ester	563-04-2	Intentional addition / 1,000ppm	chemical products
3430	Ethion	563-12-2	Contains (regardless of intentional or impurities)	chemical products
3431	3,3-Dimethylhexane	563-16-6	Contains (regardless of intentional or impurities)	chemical products
3432	Stannane, dibutyldifluoro-	563-25-7	Contains (regardless of intentional or impurities)	chemical products
3433	Ethylaluminum dichloride	563-43-9	Contains (regardless of intentional or impurities)	chemical products
3434	3-Chloro-2-methylpropene	563-47-3	Contains (regardless of intentional or impurities)	chemical products
3435	1-Propene, 1,2-dichloro-	563-54-2	Contains (regardless of intentional or impurities)	chemical products
3436	1-Propene, 3,3-dichloro-	563-57-5	Intentional addition / 1,000ppm	chemical products
3437	1,1-Dichloropropene	563-58-6	Contains (regardless of intentional or impurities)	chemical products
3438	Acetic acid, silver(1+) salt	563-63-3	Contains (regardless of intentional or impurities)	chemical products
3439	Thallium(I) acetate	563-68-8	Contains (regardless of intentional or impurities)	chemical products
3440	Carbonic acid, iron(2+) salt (1:1)	563-71-3	Intentional addition / 1%	chemical products
3441	Ethanedioic acid, calcium salt (1:1)	563-72-4	Intentional addition / 1,000ppm	chemical products
3442	Methyl isopropyl ketone	563-80-4	Contains (regardless of intentional or impurities)	chemical products
3443	Pentane, 2,2,3-trimethyl-	564-02-3	Contains (regardless of intentional or impurities)	chemical products
3444	2,3-Dimethylpentane	565-59-3	Contains (regardless of intentional or impurities)	chemical products
3445	Pentane, 2,3,4-trimethyl-	565-75-3	Contains (regardless of intentional or impurities)	chemical products
3446	C.I. Basic Red 9	569-61-9	Contains (regardless of intentional or impurities)	chemical products
3447	C.I. Basic Green 4	569-64-2	Contains (regardless of intentional or impurities)	chemical products
3448	2,6-Dinitrophenol	573-56-8	Contains (regardless of intentional or impurities)	chemical products
3449	Phenol, 2,4,6-trinitro-, potassium salt	573-83-1	Contains (regardless of intentional or impurities)	chemical products
3450	2,6-Dimethylphenol	576-26-1	Contains (regardless of intentional or impurities)	chemical products
3451	3,4-Dinitrophenol	577-71-9	Contains (regardless of intentional or impurities)	chemical products
3452	Diphenylaminechlorarsine	578-94-9	Contains (regardless of intentional or impurities)	chemical products
3453	2,6-Diethylaniline	579-66-8	Contains (regardless of intentional or impurities)	chemical products
3454	Pyrylium, 2,4,6-tris(4-methoxyphenyl)-, tetrafluoroborate(1-)	580-34-7	Intentional addition / 1%	chemical products
3455	2-Nitronaphthalene	581-89-5	Contains (regardless of intentional or impurities)	chemical products
3456	Hexane, 3,4-dimethyl-	583-48-2	Contains (regardless of intentional or impurities)	chemical products
3457	Ethanedioic acid, dipotassium salt	583-52-8	Intentional addition / 1,000ppm	chemical products
3458	Benzene, 1,2-dibromo-	583-53-9	Contains (regardless of intentional or impurities)	chemical products
3459	2-Methylcyclohexanol	583-59-5	Contains (regardless of intentional or impurities)	chemical products
3460	2-Methylcyclohexanone	583-60-8	Contains (regardless of intentional or impurities)	chemical products
3461	Butanoic acid, 2-hydroxy-4-(methylthio)-	583-91-5	Intentional addition	chemical products
3462	Benzene diazonium, 4-(diethylamino)-2-ethoxy-, tetrafluoroborate(1-)	584-59-8	Intentional addition / 1%	chemical products
3463	Benzene, 2,4-diisocyanato-1-methyl-	584-84-9	Contains (regardless of intentional or impurities)	chemical products
3464	2,3-Dimethylhexane	584-94-1	Contains (regardless of intentional or impurities)	chemical products
3465	Sodium hydrogen 4-(acetamido)phenylarsonate	585-54-6	Contains (regardless of intentional or impurities)	chemical products
3466	3,5-Dinitrophenol	586-11-8	Intentional addition	chemical products
3467	N-Allylaniline	589-09-3	Contains (regardless of intentional or impurities)	chemical products
3468	3-Methylhexane	589-34-4	Contains (regardless of intentional or impurities)	chemical products
3469	2,4-Dimethylhexane	589-43-5	Contains (regardless of intentional or impurities)	chemical products
3470	4-Methylheptane	589-53-7	Contains (regardless of intentional or impurities)	chemical products
3471	Heptane, 3-methyl-	589-61-1	Contains (regardless of intentional or impurities)	chemical products
3472	4-Methylcyclohexanol	589-91-3	Intentional addition / 1,000ppm	chemical products
3473	Cyclohexanone, 4-methyl-	589-92-4	Intentional addition / 1,000ppm	chemical products
3474	cis-1-Bromopropene	590-13-6	Intentional addition / 1,000ppm	chemical products
3475	1-Propene, 1-bromo-	590-14-7	Intentional addition / 1,000ppm	chemical products
3476	trans-1-Bromopropene	590-15-8	Intentional addition / 1,000ppm	chemical products
3477	Bromoacetone	590-17-0	Contains (regardless of intentional or impurities)	chemical products
3478	2-Butene, (Z)-	590-18-1	Contains (regardless of intentional or impurities)	chemical products
3479	1-Chloropropylene	590-21-6	Intentional addition / 1,000ppm	chemical products
3480	Allylarsonic acid	590-34-1	Contains (regardless of intentional or impurities)	chemical products
3481	Neopentane	590-35-2	Contains (regardless of intentional or impurities)	chemical products
3482	1-Methylcyclohexanol	590-67-0	Intentional addition / 1,000ppm	chemical products
3483	2,2-Dimethylhexane	590-73-8	Contains (regardless of intentional or impurities)	chemical products
3484	Propanoic acid, 3-bromo-	590-92-1	Contains (regardless of intentional or impurities)	chemical products
3485	Acetic anhydride complex salt of boron trifluoride	591-00-4	Contains (regardless of intentional or impurities)	chemical products
3486	1-Acetyl-2-thiourea	591-08-2	Contains (regardless of intentional or impurities)	chemical products
3487	3-Methylcyclohexanol	591-23-1	Intentional addition / 1,000ppm	chemical products
3488	Cyclohexanone, 3-methyl-	591-24-2	Intentional addition / 1,000ppm	chemical products
3489	Phenol, 3-amino-	591-27-5	Contains (regardless of intentional or impurities)	chemical products
3490	Iodobenzene	591-50-4	Intentional addition / 1,000ppm	chemical products
3491	9-Octadecenoic acid (Z)-, barium salt	591-65-1	Intentional addition / 100ppm	chemical products
3492	2-Methylhexane	591-76-4	Contains (regardless of intentional or impurities)	chemical products
3493	2-Hexanone	591-78-6	Contains (regardless of intentional or impurities)	chemical products
3494	Mercuric potassium cyanide	591-89-9	Contains (regardless of intentional or impurities)	chemical products
3495	Boron(1+), bis(1-butanol)difluoro-, fluoride	591-92-4	Intentional addition / 1%	chemical products
3496	Calcium cyanide	592-01-8	Contains (regardless of intentional or impurities)	chemical products
3497	Cadmium, diethyl-	592-02-9	Contains (regardless of intentional or impurities)	chemical products
3498	Platinum dicyanide	592-06-3	Contains (regardless of intentional or impurities)	chemical products
3499	2,5-Dimethylhexane	592-13-2	Contains (regardless of intentional or impurities)	chemical products
3500	2-Methylheptane	592-27-8	Contains (regardless of intentional or impurities)	chemical products
3501	Boron, trifluoro(piperidine)-, (T-4)-	592-39-2	Contains (regardless of intentional or impurities)	chemical products
3502	1-Hexene	592-41-6	Contains (regardless of intentional or impurities)	chemical products
3503	Pentane, 1-fluoro-	592-50-7	Intentional addition / 1,000ppm	chemical products
3504	4-Pentenenitrile	592-51-8	Contains (regardless of intentional or impurities)	chemical products
3505	Methylazoxymethyl acetate	592-62-1	Contains (regardless of intentional or impurities)	chemical products
3506	Boron, trifluoro[1,1'-oxybis]butane]-, (T-4)-	593-04-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
3507	Methylarsine	593-52-2	Contains (regardless of intentional or impurities)	chemical products
3508	Methyl fluoride	593-53-3	Contains (regardless of intentional or impurities)	chemical products
3509	Methyloxarsine	593-58-8	Contains (regardless of intentional or impurities)	chemical products
3510	Vinyl bromide	593-60-2	Contains (regardless of intentional or impurities)	chemical products
3511	Chlorofluoromethane	593-70-4	Intentional addition / 1,000ppm	chemical products
3512	Chloriodomethane	593-71-5	Contains (regardless of intentional or impurities)	chemical products
3513	Methyl selenide	593-79-3	Contains (regardless of intentional or impurities)	chemical products
3514	Methane, tellurobis-	593-80-6	Contains (regardless of intentional or impurities)	chemical products
3515	Trimethylarsine	593-88-4	Contains (regardless of intentional or impurities)	chemical products
3516	Methyl dichloroarsine	593-89-5	Contains (regardless of intentional or impurities)	chemical products
3517	Trimethylborane	593-89-5	Contains (regardless of intentional or impurities)	chemical products
3518	1,1-Dibromoethene	593-92-0	Intentional addition / 1,000ppm	chemical products
3519	1-Bromo-1-chloroethane	593-96-4	Intentional addition / 1,000ppm	chemical products
3520	Trimethylstibine	594-10-5	Contains (regardless of intentional or impurities)	chemical products
3521	Tribromochloromethane	594-15-0	Intentional addition / 1,000ppm	chemical products
3522	Propane, 2,2-dibromo-	594-18-1	Intentional addition / 1,000ppm	chemical products
3523	Dibromodichloromethane	594-18-3	Intentional addition / 1,000ppm	chemical products
3524	Propane, 2,2-dichloro-	594-20-7	Intentional addition / 1,000ppm	chemical products
3525	Stannane, tetramethyl-	594-27-4	Contains (regardless of intentional or impurities)	chemical products
3526	Dichlorotriphenylantimony	594-31-0	Contains (regardless of intentional or impurities)	chemical products
3527	Propane, 1,2-dibromo-2-methyl-	594-34-3	Intentional addition / 1,000ppm	chemical products
3528	Trichloromethanesulphenyl chloride	594-42-3	Contains (regardless of intentional or impurities)	chemical products
3529	Ethanesulfonyl chloride	594-44-5	Contains (regardless of intentional or impurities)	chemical products
3530	2,3-Dibromo-2-methylbutane	594-51-4	Intentional addition / 1,000ppm	chemical products
3531	Butane, 2-bromo-2,3-dimethyl-	594-52-5	Intentional addition / 1,000ppm	chemical products
3532	2,3-Dimethyl-2-chlorobutane	594-57-0	Intentional addition / 1,000ppm	chemical products
3533	1,1-Dichloro-1-nitroethane	594-72-9	Contains (regardless of intentional or impurities)	chemical products
3534	Ethane, hexabromo-	594-73-0	Intentional addition / 1,000ppm	chemical products
3535	2,3-Dibromo-2,3-dimethylbutane	594-81-0	Intentional addition / 1,000ppm	chemical products
3536	2,2,3,3-Tetramethylbutane	594-82-1	Contains (regardless of intentional or impurities)	chemical products
3537	1,1,1,2,2,3,3-Heptachloropropane	594-89-8	Intentional addition / 1,000ppm	chemical products
3538	Stannane, tetraphenyl-	595-90-4	Contains (regardless of intentional or impurities)	chemical products
3539	Propane, 1,3-dibromo-2,2-difluoro-	597-34-2	Intentional addition / 1,000ppm	chemical products
3540	Tetraethyltin	597-64-8	Contains (regardless of intentional or impurities)	chemical products
3541	Phosphorothioic acid, O,O,O-triphenyl ester	597-82-0	Intentional addition / 1,000ppm	chemical products
3542	Ethyl dichloroarsine	598-14-1	Contains (regardless of intentional or impurities)	chemical products
3543	Ethane, tribromo-	598-16-3	Contains (regardless of intentional or impurities)	chemical products
3544	1-Chloro-1,2-dibromoethane	598-20-9	Intentional addition / 1,000ppm	chemical products
3545	Bromoacetyl bromide	598-21-0	Contains (regardless of intentional or impurities)	chemical products
3546	2-Propanone, 1-bromo-	598-31-2	Contains (regardless of intentional or impurities)	chemical products
3547	Acetic acid, copper(1+) salt	598-54-9	Intentional addition / 1,000ppm	chemical products
3548	Manganese(II) carbonate	598-62-9	Contains (regardless of intentional or impurities)	chemical products
3549	Ethane, 1,1,2-tribromo-2-fluoro-	598-67-4	Intentional addition / 1,000ppm	chemical products
3550	Bromotrifluoroethylene	598-73-2	Contains (regardless of intentional or impurities)	chemical products
3551	Propane, 1,1,2-trichloro-	598-77-6	Intentional addition / 1,000ppm	chemical products
3552	2-Chloropropionic acid	598-78-7	Contains (regardless of intentional or impurities)	chemical products
3553	1,2-Dichloro-1,2-difluoroethylene	598-88-9	Contains (regardless of intentional or impurities)	chemical products
3554	Propanoic acid, 2,3-dibromo-	600-05-5	Contains (regardless of intentional or impurities)	chemical products
3555	Pentane, 2,3-dichloro-	600-11-3	Intentional addition / 1,000ppm	chemical products
3556	1-Chloro-1-nitropropane	600-25-9	Contains (regardless of intentional or impurities)	chemical products
3557	N-Nitrosodisopropylamine	601-77-4	Intentional addition / 100ppm	chemical products
3558	Toluene, 2,3-dinitro-	602-01-7	Contains (regardless of intentional or impurities)	chemical products
3559	1,1-Binaphthalene-2,2'-diol	602-09-5	Intentional addition / 1%	chemical products
3560	2,3,4-Trinitrotoluene	602-29-9	Intentional addition / 1%	chemical products
3561	Naphthalene, 1,8-dinitro-	602-39-0	Contains (regardless of intentional or impurities)	chemical products
3562	5-Nitroacenaphthene	602-97-9	Contains (regardless of intentional or impurities)	chemical products
3563	Arsine, trimethyl-	603-15-6	Intentional addition / 1%	chemical products
3564	Arsine, dimethyl-1,2,3-trinitro-	603-32-7	Contains (regardless of intentional or impurities)	chemical products
3565	Triphenylamine	603-34-9	Intentional addition / 1%	chemical products
3566	Stibine, triphenyl-	603-36-1	Contains (regardless of intentional or impurities)	chemical products
3567	9,10-Anthracenedione, 2-hydroxy-	605-32-3	Contains (regardless of intentional or impurities)	chemical products
3568	1,5-Dinitronaphthalene	605-71-0	Contains (regardless of intentional or impurities)	chemical products
3569	2,6-Dinitrotoluene	606-20-2	Contains (regardless of intentional or impurities)	chemical products
3570	1,3-Dinitronaphthalene	606-37-1	Contains (regardless of intentional or impurities)	chemical products
3571	Benzenamine, 2,3-dichloro-	608-27-5	Contains (regardless of intentional or impurities)	chemical products
3572	Benzenamine, 2,6-dichloro-	608-31-1	Contains (regardless of intentional or impurities)	chemical products
3573	Pentabromophenol	608-71-9	Contains (regardless of intentional or impurities)	chemical products
3574	1,2,3,4,5,6-Hexachlorocyclohexane	608-73-1	Contains (regardless of intentional or impurities)	chemical products
3575	2,6-Dichloro-p-phenylenediamine	609-20-1	Intentional addition / 1,000ppm	chemical products
3576	2-Methyl-3-ethylpentane	609-26-7	Contains (regardless of intentional or impurities)	chemical products
3577	Benzenesulfonyl chloride, 2,4-dimethyl-	609-60-9	Contains (regardless of intentional or impurities)	chemical products
3578	Benzoyl chloride, 2-chloro-	609-65-4	Contains (regardless of intentional or impurities)	chemical products
3579	2,3,5-Trinitrotoluene	609-74-5	Intentional addition / 1%	chemical products
3580	2,4-Dichloro-6-nitrophenol	609-89-2	Intentional addition / 1%	chemical products
3581	Phenol, 4-methyl-2,6-dinitro-	609-93-8	Intentional addition	chemical products
3582	2,4,5-Trinitrotoluene	610-25-3	Intentional addition / 1%	chemical products
3583	3,4-dinitrotoluene	610-39-9	Contains (regardless of intentional or impurities)	chemical products
3584	Benzeneacetone, 2-nitro-	610-66-2	Contains (regardless of intentional or impurities)	chemical products
3585	Benzene, 2,4-dichloro-1-nitro-	611-06-3	Contains (regardless of intentional or impurities)	chemical products
3586	2-Methylstyrene	611-15-4	Contains (regardless of intentional or impurities)	chemical products
3587	1-(Bromomethyl)-2-chlorobenzene	611-17-6	Intentional addition / 1,000ppm	chemical products
3588	Benzene, 1-chloro-2-(chloromethyl)-	611-19-8	Intentional addition / 1%	chemical products
3589	Benzenitrile, 2-hydroxy-	611-20-1	Intentional addition	chemical products
3590	Benzenamine, N,2-dimethyl-	611-21-2	Contains (regardless of intentional or impurities)	chemical products
3591	3,3'-Diaminobenzophenone	611-79-0	Contains (regardless of intentional or impurities)	chemical products
3592	2-Nitrobenzonitrile	612-24-8	Intentional addition	chemical products
3593	2-Naphthylamine hydrochloride	612-52-2	Contains (regardless of intentional or impurities)	chemical products
3594	Aniline, N-ethyl-N-nitroso-	612-64-6	Intentional addition / 100ppm	chemical products
3595	3,3'-Dimethylbenzidine dihydrochloride	612-82-8	Contains (regardless of intentional or impurities)	chemical products
3596	3,3'-Dichlorobenzidine dihydrochloride	612-83-9	Contains (regardless of intentional or impurities)	chemical products
3597	4,4'-Biacetanilide	613-35-4	Contains (regardless of intentional or impurities)	chemical products
3598	2-Naphthalenecarbonitrile	613-46-7	Intentional addition	chemical products
3599	o-Phenylenediacetonitrile	613-73-0	Intentional addition	chemical products
3600	Benzeneacetone, alpha-oxo-	613-90-1	Contains (regardless of intentional or impurities)	chemical products
3601	Benzenamine, N-methyl-N-nitroso-	614-00-6	Intentional addition / 100ppm	chemical products
3602	Benzenepropanenitrile, beta-oxo-	614-16-4	Contains (regardless of intentional or impurities)	chemical products
3603	tert-Butyl peroxybenzoate	614-45-9	Contains (regardless of intentional or impurities)	chemical products
3604	2,5-Diisocyanatotoluene	614-90-4	Intentional addition / 1%	chemical products
3605	1,3-Benzenediamine, 4-methoxy-	615-05-4	Contains (regardless of intentional or impurities)	chemical products
3606	1,2-Benzenediamine, dihydrochloride	615-28-1	Contains (regardless of intentional or impurities)	chemical products
3607	1,4-Benzenediamine, 2-methyl-, dihydrochloride	615-45-2	Intentional addition / 2%	chemical products
3608	1,4-Benzenediamine, 2-methyl-, sulfate (1:1)	615-50-9	Contains (regardless of intentional or impurities)	chemical products
3609	Carbamic acid, methylnitroso-, ethyl ester	615-53-2	Contains (regardless of intentional or impurities)	chemical products
3610	Benzene, 1,2,4-tribromo-	615-54-5	Intentional addition / 1,000ppm	chemical products
3611	2,4-Dibromophenol	615-58-7	Contains (regardless of intentional or impurities)	chemical products
3612	Pentane, 3-chloro-	616-20-6	Contains (regardless of intentional or impurities)	chemical products
3613	1,2-Dichlorobutane	616-21-7	Intentional addition / 1,000ppm	chemical products
3614	1-Propanol, 2,3-dichloro-	616-23-9	Contains (regardless of intentional or impurities)	chemical products
3615	Triethylarsine	617-75-4	Contains (regardless of intentional or impurities)	chemical products
3616	3-Ethylpentane	617-78-7	Contains (regardless of intentional or impurities)	chemical products
3617	Triethylstibine	617-85-6	Contains (regardless of intentional or impurities)	chemical products
3618	2-Furonitrile	617-90-3	Contains (regardless of intentional or impurities)	chemical products
3619	4-Acetamidophenylarsonic acid	618-22-4	Contains (regardless of intentional or impurities)	chemical products
3620	4-Arsinophenylglycinamide	618-25-7	Intentional addition / 1%	chemical products
3621	Sulfarsphenamine	618-82-6	Contains (regardless of intentional or impurities)	chemical products
3622	3,5-dinitrotoluene	618-85-9	Contains (regardless of intentional or impurities)	chemical products
3623	Toluene, 2,5-dinitro-	619-15-8	Contains (regardless of intentional or impurities)	chemical products
3624	Benzenitrile, 3-nitro-	619-24-9	Intentional addition	chemical products
3625	Benzoic acid, 4-cyano-	619-65-8	Contains (regardless of intentional or impurities)	chemical products
3626	Benzenitrile, 4-nitro-	619-72-7	Intentional addition	chemical products
3627	Hexane, 3-ethyl-	619-99-8	Contains (regardless of intentional or impurities)	chemical products
3628	Benzyl iodide	620-05-3	Intentional addition / 1,000ppm	chemical products
3629	3-Pentanol, acetate	620-11-1	Intentional addition / 1,000ppm	chemical products
3630	Benzenitrile, 3-methyl-	620-22-4	Contains (regardless of intentional or impurities)	chemical products
3631	Arsenic acid, (phenylmethyl)-	620-27-9	Contains (regardless of intentional or impurities)	chemical products
3632	Phenol, 4,4'-methylenbis-	620-92-8	Intentional addition / 1,000ppm	chemical products
3633	Acetamide, 2-cyano-N-phenyl-	621-03-4	Intentional addition	chemical products
3634	3-Nitrophenylacetone	621-50-1	Contains (regardless of intentional or impurities)	chemical products
3635	1-Propanamine, N-nitroso-N-propyl-	621-64-7	Contains (regardless of intentional or impurities)	chemical products
3636	Tri-n-amy borate	621-78-3	Intentional addition / 1%	chemical products
3637	Benzenamine, 4,4'-(1,2-ethanediyl)bis-	621-95-4	Contains (regardless of intentional or impurities)	chemical products
3638	N-Ethyl-p-toluidine	622-57-1	Contains (regardless of intentional or impurities)	chemical products
3639	4-(4-Dimethylamino)phenylazo)phenylarsonic acid	622-68-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
3640	1,4-Benzenediacetonitrile	622-75-3	Contains (regardless of intentional or impurities)	chemical products
3641	Benzenamine, N-propyl-	622-80-0	Contains (regardless of intentional or impurities)	chemical products
3642	1-(Bromomethyl)-4-chlorobenzene	622-95-7	Intentional addition / 1,000ppm	chemical products
3643	4-Methylstyrene	622-97-9	Contains (regardless of intentional or impurities)	chemical products
3644	4-Bromobenzonitrile	623-00-7	Intentional addition	chemical products
3645	Benzonitrile, 4-chloro-	623-03-0	Intentional addition	chemical products
3646	Ethane, 1,2-dichloro-1-ethoxy-	623-46-1	Contains (regardless of intentional or impurities)	chemical products
3647	Acetic acid, iodo-, ethyl ester	623-48-3	Contains (regardless of intentional or impurities)	chemical products
3648	Carbonoic acid, ethyl ester	623-49-4	Contains (regardless of intentional or impurities)	chemical products
3649	p-Phenylenediamine dihydrochloride	624-18-0	Contains (regardless of intentional or impurities)	chemical products
3650	Hexane, 1,2-dibromo-	624-20-4	Intentional addition / 1,000ppm	chemical products
3651	2-Methylbutyl acetate	624-41-9	Contains (regardless of intentional or impurities)	chemical products
3652	2-Butenedioic acid (E)-, dimethyl ester	624-49-7	Contains (regardless of intentional or impurities)	chemical products
3653	2-Butene, (2E)-	624-64-6	Contains (regardless of intentional or impurities)	chemical products
3654	1-Propyne, 3-chloro-	624-65-7	Intentional addition / 1,000ppm	chemical products
3655	1,2-Difluoroethane	624-72-6	Contains (regardless of intentional or impurities)	chemical products
3656	Didoacetylene	624-74-8	Intentional addition / 1,000ppm	chemical products
3657	Iodoacetone	624-75-9	Contains (regardless of intentional or impurities)	chemical products
3658	Ethanamine, N-methyl-	624-78-2	Intentional addition / 100ppm	chemical products
3659	Methyl isocyanate	624-83-9	Contains (regardless of intentional or impurities)	chemical products
3660	Methyl nitrite	624-91-9	Contains (regardless of intentional or impurities)	chemical products
3661	Dimethyl disulfide	624-92-0	Contains (regardless of intentional or impurities)	chemical products
3662	1,1-Dimethyl-3-oxobutylammonium hydrogen oxalate	625-03-6	Intentional addition	chemical products
3663	tert-Amyl acetate	625-16-1	Intentional addition / 1,000ppm	chemical products
3664	Butanenitrile, 3-methyl-	625-28-5	Contains (regardless of intentional or impurities)	chemical products
3665	Pentane, 2-chloro-	625-29-6	Contains (regardless of intentional or impurities)	chemical products
3666	Benzene, 1-iodo-3-methyl-	625-95-6	Intentional addition / 1,000ppm	chemical products
3667	Benzene, 1-chloro-3-fluoro-	625-98-9	Contains (regardless of intentional or impurities)	chemical products
3668	m-Phthalodinitrile	626-17-5	Intentional addition / 1%	chemical products
3669	m-Phenylenediacetonitrile	626-22-2	Intentional addition	chemical products
3670	2-Pentyl acetate	626-38-0	Contains (regardless of intentional or impurities)	chemical products
3671	Benzenamine, 3,5-dichloro-	626-43-7	Contains (regardless of intentional or impurities)	chemical products
3672	Pentane, 1,4-dibromo-	626-87-9	Intentional addition / 1,000ppm	chemical products
3673	Pentane, 1-bromo-4-methyl-	626-88-0	Intentional addition / 1,000ppm	chemical products
3674	n-Propyl nitrate	627-13-4	Contains (regardless of intentional or impurities)	chemical products
3675	1-Propanol, 3-bromo-	627-18-9	Contains (regardless of intentional or impurities)	chemical products
3676	3-Chloro-1-propanol	627-30-5	Contains (regardless of intentional or impurities)	chemical products
3677	Ethane, 1,1'-selenobis-	627-53-2	Contains (regardless of intentional or impurities)	chemical products
3678	Ethane, 1,1'-tellurobis-	627-54-3	Contains (regardless of intentional or impurities)	chemical products
3679	Pentane, 1-iodo-	628-17-1	Contains (regardless of intentional or impurities)	chemical products
3680	Butanenitrile, 4-chloro-	628-20-6	Intentional addition	chemical products
3681	Diselenide, diethyl	628-39-7	Contains (regardless of intentional or impurities)	chemical products
3682	Acetic acid, chromium(2+) salt	628-52-4	Contains (regardless of intentional or impurities)	chemical products
3683	Octane, 2-chloro-	628-61-5	Intentional addition / 1,000ppm	chemical products
3684	n-Amyl acetate	628-63-7	Contains (regardless of intentional or impurities)	chemical products
3685	Hexanenitrile	628-73-9	Contains (regardless of intentional or impurities)	chemical products
3686	1,5-Dichloropentane	628-76-2	Contains (regardless of intentional or impurities)	chemical products
3687	Mercury fulminate	628-86-4	Contains (regardless of intentional or impurities)	chemical products
3688	Acetonitrile, 2,2'-iminobis-	628-87-5	Intentional addition	chemical products
3689	Ethylene glycol dinitrate	628-96-6	Contains (regardless of intentional or impurities)	chemical products
3690	Hexane, 1,6-dibromo-	629-03-8	Intentional addition / 1,000ppm	chemical products
3691	Heptane, 1-bromo-	629-04-9	Intentional addition / 1,000ppm	chemical products
3692	Heptane, 1-chloro-	629-06-1	Intentional addition / 1,000ppm	chemical products
3693	Octane, 1-iodo-	629-27-6	Intentional addition / 1,000ppm	chemical products
3694	Octanedinitrile	629-40-3	Contains (regardless of intentional or impurities)	chemical products
3695	Nitrous acid, octyl ester	629-46-9	Intentional addition / 1,000ppm	chemical products
3696	Tridecanitrile	629-60-7	Contains (regardless of intentional or impurities)	chemical products
3697	Pentadecane, 1-bromo-	629-72-1	Intentional addition / 1,000ppm	chemical products
3698	Carbon monoxide	630-08-0	Contains (regardless of intentional or impurities)	chemical products
3699	Selenourea	630-10-4	Contains (regardless of intentional or impurities)	chemical products
3700	1,1,1,2-Tetrabromoethane	630-18-0	Intentional addition / 1,000ppm	chemical products
3701	Propane, 1-bromo-2,2-dimethyl-	630-17-1	Intentional addition / 1,000ppm	chemical products
3702	Propanenitrile, 2,2-dimethyl-	630-18-2	Contains (regardless of intentional or impurities)	chemical products
3703	1,1,1,2-Tetrachloroethane	630-20-6	Contains (regardless of intentional or impurities)	chemical products
3704	1,2-Dibromotetrachloroethane	630-25-1	Intentional addition / 1,000ppm	chemical products
3705	Morphine hydroiodide	630-82-0	Intentional addition / 1,000ppm	chemical products
3706	1,2,3-Tribromo-2-methylpropane	631-28-7	Intentional addition / 1,000ppm	chemical products
3707	2-Oxopropionitrile	631-57-2	Contains (regardless of intentional or impurities)	chemical products
3708	Urea, ethanedioate (2:1)	631-62-9	Intentional addition / 1,000ppm	chemical products
3709	Butane, 1,2,3-tribromo-	632-05-3	Intentional addition / 1,000ppm	chemical products
3710	1,3-Isobenzofurandione, 4,5,6,7-tetrabromo-	632-79-1	Intentional addition / 900ppm	chemical products
3711	Benzenamine, 4-[[4-aminophenyl(4-imino-2,5-cyclohexadien-1-ylidene)methyl]-2-methyl-, hydrochloride (1:1)	632-99-5	Intentional addition / 1%	chemical products
3712	C.I. Basic Green 1	633-03-4	Contains (regardless of intentional or impurities)	chemical products
3713	Hydrazine, [R-(Rt)2]-2,3-dihydroxybutanedioate (1:1)	634-62-8	Contains (regardless of intentional or impurities)	chemical products
3714	1,2,3,4-Tetrachlorobenzene	634-66-2	Contains (regardless of intentional or impurities)	chemical products
3715	Benzene, 1,2,3,5-tetrachloro-	634-90-2	Contains (regardless of intentional or impurities)	chemical products
3716	Cyclohexanol, 5-methyl-2-(1-methylethyl)-, triester with boric acid(H3BO3)	635-20-1	Intentional addition / 1%	chemical products
3717	Benzoic acid, manganese(2+) salt	636-13-5	Contains (regardless of intentional or impurities)	chemical products
3718	o-Toluidine hydrochloride	636-21-5	Contains (regardless of intentional or impurities)	chemical products
3719	1,3-Benzenediamine, 4-methyl-, dihydrochloride	636-23-7	Intentional addition / 25%	chemical products
3720	Benzene, 1,2,4,5-tetrabromo-	636-28-2	Intentional addition / 1,000ppm	chemical products
3721	Benzene, 1-iodo-4-nitro-	636-98-6	Contains (regardless of intentional or impurities)	chemical products
3722	Arsine, oxophenyl-	637-03-6	Contains (regardless of intentional or impurities)	chemical products
3723	Manganese succinate	637-82-1	Contains (regardless of intentional or impurities)	chemical products
3724	Ethyl tert-butyl ether	637-92-3	Intentional addition / 1%	chemical products
3725	m-Toluidinium chloride	638-03-9	Intentional addition / 25%	chemical products
3726	Phenylphosphine	638-21-1	Contains (regardless of intentional or impurities)	chemical products
3727	Hexane, 2-chloro-	638-28-8	Intentional addition / 1,000ppm	chemical products
3728	Manganese(II) acetate	638-38-0	Contains (regardless of intentional or impurities)	chemical products
3729	Tin(II) acetate	638-39-1	Contains (regardless of intentional or impurities)	chemical products
3730	Hexyl nitrite	638-51-7	Intentional addition / 1,000ppm	chemical products
3731	Diiodochloromethane	638-73-3	Intentional addition / 1,000ppm	chemical products
3732	Thiometon	640-15-3	Contains (regardless of intentional or impurities)	chemical products
3733	Acetamide, 2-fluoro-	640-19-7	Contains (regardless of intentional or impurities)	chemical products
3734	Butane, 1,2-dibromo-3,3-dimethyl-	640-21-1	Intentional addition / 1,000ppm	chemical products
3735	Ethanedioic acid, manganese(2+) salt (1:1)	640-67-5	Contains (regardless of intentional or impurities)	chemical products
3736	Benzene	645-59-0	Contains (regardless of intentional or impurities)	chemical products
3737	Benzene	645-96-5	Contains (regardless of intentional or impurities)	chemical products
3738	9,12-Octadecadienoic acid (Z,Z)-, manganese(2+) salt	646-00-4	Contains (regardless of intentional or impurities)	chemical products
3739	1,3-Dioxolane	646-06-0	Contains (regardless of intentional or impurities)	chemical products
3740	Heptanenitrile	646-20-9	Contains (regardless of intentional or impurities)	chemical products
3741	2,2,3,3,4,5,5-Heptafluoro-4-(perfluorobutyl)oxolane	646-85-5	Intentional addition / 1%	chemical products
3742	Perfluorooctanenitrile	647-12-1	Intentional addition	chemical products
3743	(Pentafluorophenyl)acetone	653-30-5	Contains (regardless of intentional or impurities)	chemical products
3744	(Chloromethyl)pentafluorobenzene	653-35-0	Intentional addition / 1,000ppm	chemical products
3745	Nicotinic hexafluorosilicate(2-)(2:1)	653-81-6	Contains (regardless of intentional or impurities)	chemical products
3746	(2,6-Difluorophenyl)acetone	654-01-3	Contains (regardless of intentional or impurities)	chemical products
3747	(2,4-Difluorophenyl)acetone	656-35-9	Intentional addition	chemical products
3748	(3,4-Difluorophenyl)acetone	658-99-1	Contains (regardless of intentional or impurities)	chemical products
3749	Tris(2,2-trifluoroethyl) borate	659-18-7	Intentional addition / 1%	chemical products
3750	Boron, (benzenamine)trifluoro-, (T-4)-	660-53-7	Contains (regardless of intentional or impurities)	chemical products
3751	Octadecanoic acid, copper(2+) salt	660-60-6	Intentional addition / 1,000ppm	chemical products
3752	Heptane, 1-fluoro-	661-11-0	Intentional addition / 1,000ppm	chemical products
3753	2-Propanamine, 2-methyl-, compound with trifluoroborane (1:1)	661-32-5	Intentional addition / 1%	chemical products
3754	Tetramethylammonium tetrafluoroborate	661-36-9	Intentional addition / 1%	chemical products
3755	3,3,3-Trifluoropropyne	661-54-1	Contains (regardless of intentional or impurities)	chemical products
3756	Hexamethyldistannane	661-69-8	Contains (regardless of intentional or impurities)	chemical products
3757	1,3-Dibromo-1,1,2,2,3-pentafluoropropane	661-80-3	Intentional addition	chemical products
3758	1,1,1,2,2,3-Hexachloro-3,3-difluoropropane	661-96-1	Intentional addition	chemical products
3759	Propane, 1,2-dichloro-1,1,2,3,3,3-hexafluoro-	661-97-2	Contains (regardless of intentional or impurities)	chemical products
3760	1,3-Dichloro-1,1,2,2,3,3-hexafluoropropane	662-01-1	Intentional addition	chemical products
3761	Tetraethyl phosphonium tetrafluoroborate	665-49-6	Intentional addition / 1%	chemical products
3762	Borate(1-), trifluoro(propanoate-O)-, hydrogen, (T-4)-	666-12-6	Intentional addition / 1,000ppm	chemical products
3763	Propane, 1,2,3-tribromo-1,1-difluoro-	666-25-1	Intentional addition / 1,000ppm	chemical products
3764	1,1,2,3-Tetrachloro-1-fluoropropane	666-27-3	Intentional addition / 1,000ppm	chemical products
3765	Propane, 1,2,3-tribromo-1,1,3,3-tetrafluoro-	666-48-8	Intentional addition / 100ppm	chemical products
3766	Fentin	668-34-8	Contains (regardless of intentional or impurities)	chemical products
3767	2-Chloro-6-fluorobenzonitrile	668-45-1	Intentional addition	chemical products
3768	Tetracyanomethylene	670-54-2	Contains (regardless of intentional or impurities)	chemical products
3769	Carbanolate	671-04-5	Contains (regardless of intentional or impurities)	chemical products
3770	Boron, trifluoro(2,2,2'-nitrotris[ethano]-N)-, (T-4)-	673-24-5	Contains (regardless of intentional or impurities)	chemical products
3771	p-Bromobenzenediazonium tetrafluoroborate	673-40-5	Intentional addition / 1%	chemical products
3772	Diketene	674-82-8	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
3773	(1E,5E,9E)-Cyclododeca-1,5,9-triene	676-22-2	Intentional addition / 1%	chemical products
3774	Boron, trifluoro(2-propanol)-	676-65-3	Intentional addition / 1%	chemical products
3775	Dibromomethylarsine	676-70-0	Contains (regardless of intentional or impurities)	chemical products
3776	Dimethylbromarsine	676-71-1	Contains (regardless of intentional or impurities)	chemical products
3777	Iododimethylarsine	676-75-5	Contains (regardless of intentional or impurities)	chemical products
3778	Methyl phosphonous dichloride	676-83-5	Contains (regardless of intentional or impurities)	chemical products
3779	Trimethylsulfonium tetrafluoroborate(1-)	676-88-0	Intentional addition / 1%	chemical products
3780	Methyl phosphonic dichloride	676-97-1	Intentional addition	chemical products
3781	1-Propene, 3,3,3-trifluoro-	677-21-4	Intentional addition / 1,000ppm	chemical products
3782	Ethane, 1,2,2-tribromo-1,1-difluoro-	677-34-9	Intentional addition / 1,000ppm	chemical products
3783	Propane, 2-bromo-1,1,1,2,3-pentafluoro-	677-52-1	Intentional addition / 1,000ppm	chemical products
3784	Propane, 1-bromo-1,1,2,2,3-pentafluoro-	677-52-2	Intentional addition / 1,000ppm	chemical products
3785	1,1,1,3-tetrachloro-2,2-difluoropropane	677-54-3	Intentional addition	chemical products
3786	1-Chloro-1,1,2,2,3-pentafluoropropane	677-55-4	Intentional addition / 1,000ppm	chemical products
3787	1,1,1,2,2,3-Hexafluoropropane	677-56-5	Contains (regardless of intentional or impurities)	chemical products
3788	Perfluoro(2-methylpropanoyl) fluoride	677-84-9	Contains (regardless of intentional or impurities)	chemical products
3789	Decane, 1,1,1,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10-eicosafuoro-10-iodo-2-(trifluoromethyl)-	677-93-0	Contains (regardless of intentional or impurities)	chemical products
3790	Pentane, dodecafluoro-	678-28-2	Contains (regardless of intentional or impurities)	chemical products
3791	1-Decanol, 3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10-heptadecafluoro-	678-39-7	Contains (regardless of intentional or impurities)	chemical products
3792	Propane, 3-bromo-1,1,2,2-tetrafluoro-	679-84-5	Contains (regardless of intentional or impurities)	chemical products
3793	Chlorotetrafluoropropane	679-85-6	Intentional addition / 1,000ppm	chemical products
3794	1,1,2,2,3-Pentafluoropropane	679-86-7	Contains (regardless of intentional or impurities)	chemical products
3795	Propane, 1-bromo-1,2,2,3,3-pentafluoro-	679-94-7	Intentional addition / 100ppm	chemical products
3796	1-Chloro-1,2,2,3,3-pentafluoropropane	679-99-2	Intentional addition / 1,000ppm	chemical products
3797	Hexamethylphosphoramide	680-31-9	Contains (regardless of intentional or impurities)	chemical products
3798	Methyl silicate	681-84-5	Contains (regardless of intentional or impurities)	chemical products
3799	Tributyltin isocyanate	681-99-2	Contains (regardless of intentional or impurities)	chemical products
3800	Tributylstannyl ethoxide	682-00-8	Intentional addition / 1,000ppm	chemical products
3801	Fluorotripropylstannane	682-32-6	Contains (regardless of intentional or impurities)	chemical products
3802	Dibromoethylarsine	683-43-2	Contains (regardless of intentional or impurities)	chemical products
3803	Cyanodimethylarsine	683-45-4	Contains (regardless of intentional or impurities)	chemical products
3804	Hexafluoroacetone	684-16-2	Contains (regardless of intentional or impurities)	chemical products
3805	Arsine, chlorodiethyl-	686-61-3	Contains (regardless of intentional or impurities)	chemical products
3806	Boric acid (H3BO3), tripropyl ester	688-71-1	Intentional addition / 1%	chemical products
3807	Tri-n-butyltin hydride	688-73-3	Contains (regardless of intentional or impurities)	chemical products
3808	Tributyl borate	688-74-4	Intentional addition / 1%	chemical products
3809	2-Ethylhexyl methacrylate	688-84-6	Intentional addition / 1,000ppm	chemical products
3810	1,1,3,3,3-Pentafluoropropene	690-27-7	Contains (regardless of intentional or impurities)	chemical products
3811	Propane, 1,1,1,3,3,3-hexafluoro-	690-39-1	Contains (regardless of intentional or impurities)	chemical products
3812	Alkanol(C2-4) complex salt of boron trifluoride	692-39-7	Contains (regardless of intentional or impurities)	chemical products
3813	Arsine, diethyl-	692-42-2	Contains (regardless of intentional or impurities)	chemical products
3814	Propanenitrile, 3-(methylamino)-	693-05-0	Intentional addition	chemical products
3815	Nonane, 1-bromo-	693-58-3	Intentional addition / 1,000ppm	chemical products
3816	Undecane, 1-bromo-	693-67-4	Intentional addition / 1,000ppm	chemical products
3817	Benzene, 1-bromo-2-chloro-	694-80-4	Intentional addition / 1,000ppm	chemical products
3818	Dichlorophenylarsine	696-28-6	Contains (regardless of intentional or impurities)	chemical products
3819	Benzenamine, N,3-dimethyl-	696-44-6	Contains (regardless of intentional or impurities)	chemical products
3820	Boron, (benzenemethanamine)trifluoro-, (T-4)-	696-99-1	Intentional addition / 1%	chemical products
3821	N-(2-Cyanoethyl)cyclohexylamine	702-03-4	Intentional addition	chemical products
3822	3-(Benzylamino)propionitrile	706-03-6	Intentional addition	chemical products
3823	1,5,9-Cyclododecatiene, (E,E,2)-	706-31-0	Intentional addition / 1%	chemical products
3824	Benzothiazolium, 3-methyl-, perchlorate	706-62-7	Intentional addition / 1,000ppm	chemical products
3825	Diphenylchlorarsine	712-48-1	Contains (regardless of intentional or impurities)	chemical products
3826	2,3,4,5-(Benzenetetracarboxyl)	712-48-1	Intentional addition	chemical products
3827	Methanesulfenamide, 1,1-dichloro-N-[(dimethylamino)sulfonyl]-1-fluoro-N-(4-methylphenyl)-	731-27-1	Intentional addition / 10ppm	chemical products
3828	Phosmet	732-11-6	Contains (regardless of intentional or impurities)	chemical products
3829	2-Fluoro-2-methylamino-5-nitrobenzophenone	735-06-8	Contains (regardless of intentional or impurities)	chemical products
3830	1,3,5-tris(tributyltin)-S-triazine-2,4,6-trione	752-58-9	Contains (regardless of intentional or impurities)	chemical products
3831	Boron trifluoride acetic acid	753-53-7	Intentional addition / 1%	chemical products
3832	Hydroxymethylloxostannane	753-61-7	Contains (regardless of intentional or impurities)	chemical products
3833	Stannane, dichlorodimethyl-	753-73-1	Contains (regardless of intentional or impurities)	chemical products
3834	1-Propene, 2,3,3,3-tetrafluoro-	754-12-1	Contains (regardless of intentional or impurities)	chemical products
3835	1,1,2,2,3,3,4,4-Octafluoro-5-chloropentane	755-21-5	Intentional addition / 1,000ppm	chemical products
3836	Dimethyl methylphosphonate	756-79-6	Intentional addition	chemical products
3837	1-Bromo-1-chloro-2,2-difluoroethylene	758-24-7	Intentional addition / 1,000ppm	chemical products
3838	3,4-Dichloro-1-butene	760-23-6	Intentional addition / 1,000ppm	chemical products
3839	Stannane, tripropyl-	761-44-4	Contains (regardless of intentional or impurities)	chemical products
3840	Boron trifluoride propanol complex	762-48-1	Intentional addition / 1%	chemical products
3841	1-Bromo-2-fluoroethane	762-49-2	Contains (regardless of intentional or impurities)	chemical products
3842	Ethane, 1-chloro-2-fluoro-	762-50-5	Intentional addition / 1,000ppm	chemical products
3843	Vinylmercuric chloride	762-55-0	Contains (regardless of intentional or impurities)	chemical products
3844	2-Pentenal	764-39-6	Intentional addition / 1%	chemical products
3845	1,4-Dichloro-2-butene	764-41-0	Contains (regardless of intentional or impurities)	chemical products
3846	Fumaronitrile	764-42-1	Intentional addition	chemical products
3847	Tridecane, 1-bromo-	765-09-3	Intentional addition / 1,000ppm	chemical products
3848	Glycidaldehyde	765-34-4	Contains (regardless of intentional or impurities)	chemical products
3849	2,2,3,3-Tetrafluorooxetane	765-63-9	Contains (regardless of intentional or impurities)	chemical products
3850	Cyclohexanecarbonitrile	766-05-2	Contains (regardless of intentional or impurities)	chemical products
3851	1-(Bromomethyl)-3-chlorobenzene	766-80-3	Intentional addition / 1,000ppm	chemical products
3852	3-Chlorobenzonitrile	766-84-7	Intentional addition	chemical products
3853	Benzonitrile, 4-hydroxy-	767-00-0	Intentional addition	chemical products
3854	1-Butylpyrrolidine	767-10-2	Intentional addition / 25%	chemical products
3855	Boronic acid, B-(3-fluorophenyl)-	768-35-4	Intentional addition / 1%	chemical products
3856	N-Isopropylaniline	768-52-5	Contains (regardless of intentional or impurities)	chemical products
3857	2-Hydroxy-4,6-dimethylnicotinonitrile	769-28-8	Intentional addition	chemical products
3858	Benzeneacetone, alpha-ethyl-	769-68-6	Intentional addition	chemical products
3859	1H-Indole-3-acetonitrile	771-51-7	Intentional addition	chemical products
3860	1,2,3-Trifluoro-4-nitrobenzene	771-69-7	Contains (regardless of intentional or impurities)	chemical products
3861	Pyrylium, 2,4,6-trimethyl-, tetrafluoroborate(1-)	773-01-3	Intentional addition / 1%	chemical products
3862	Benzonitrile, pentafluoro-	773-82-0	Contains (regardless of intentional or impurities)	chemical products
3863	2-(Trifluoromethyl)benzenesulfonyl chloride	776-04-5	Contains (regardless of intentional or impurities)	chemical products
3864	2-Nitro-4-(trifluoromethyl)benzonitrile	778-94-9	Intentional addition	chemical products
3865	Hydrazine, 1,2-bis(2-chlorophenyl)-	782-74-1	Intentional addition / 1%	chemical products
3866	Carbophenothion	786-19-6	Contains (regardless of intentional or impurities)	chemical products
3867	o,p'-DDT	789-02-6	Contains (regardless of intentional or impurities)	chemical products
3868	1,4-Benzenediamine, N1-(1,3-dimethylbutyl)-N4-phenyl-	793-24-8	Intentional addition / 1%	chemical products
3869	Boron, trifluoro(N-methylmethanamine)-, (T-4)-	811-59-6	Intentional addition / 1%	chemical products
3870	Trimethyltin iodide	811-73-4	Contains (regardless of intentional or impurities)	chemical products
3871	Ethane, 1,1,2-trichloro-1-fluoro-	811-95-0	Intentional addition / 1,000ppm	chemical products
3872	1,1,1,2-tetrafluoroethane	811-97-2	Contains (regardless of intentional or impurities)	chemical products
3873	Propane, 1,1,1,2-tetrachloro-	812-02-3	Intentional addition / 1,000ppm	chemical products
3874	1,1-Dichloro-1,2,2-trifluoroethane	812-04-4	Intentional addition / 1,000ppm	chemical products
3875	1,1,2-Trichloropentafluoropropane	812-30-6	Contains (regardless of intentional or impurities)	chemical products
3876	Hexabutylstannane	813-19-4	Contains (regardless of intentional or impurities)	chemical products
3877	2,2,3-Trichloropropionitrile	813-74-1	Intentional addition	chemical products
3878	Aluminum citrate	813-92-3	Intentional addition / 1,000ppm	chemical products
3879	Borate(1-), difluorobis(propanoato-O)-, hydrogen fluoride (1:2:1), (T-4)-	814-61-9	Intentional addition / 1%	chemical products
3880	Cupric lactate	814-81-3	Intentional addition / 1,000ppm	chemical products
3881	Mercuric lactate	814-82-4	Contains (regardless of intentional or impurities)	chemical products
3882	Dialuminium trioxalate	814-87-9	Intentional addition / 1,000ppm	chemical products
3883	Ethanedioic acid, cadmium salt (1:1)	814-88-0	Contains (regardless of intentional or impurities)	chemical products
3884	Ethanedioic acid, cobalt(2+) salt (1:1)	814-89-1	Intentional addition / 1,000ppm	chemical products
3885	Chromium oxalate (1:1)	814-90-4	Contains (regardless of intentional or impurities)	chemical products
3886	Ethanedioic acid, copper(2+) salt (1:1)	814-91-5	Intentional addition / 1,000ppm	chemical products
3887	Ethanedioic acid, tin(2+) salt (1:1)	814-94-8	Contains (regardless of intentional or impurities)	chemical products
3888	Ethanedioic acid, strontium salt (1:1)	814-95-9	Intentional addition / 1,000ppm	chemical products
3889	1-Pentene, 3-bromo-4-methyl-	815-47-4	Intentional addition / 1,000ppm	chemical products
3890	Butanedioic acid, 2,3-dihydroxy-(2R,3R)-, copper(2+) salt (1:1)	815-82-7	Intentional addition / 1,000ppm	chemical products
3891	Butanedioic acid, 2,3-dihydroxy-[R-(R*,R*)]-, tin(2+) salt (1:1)	815-85-0	Contains (regardless of intentional or impurities)	chemical products
3892	1,3-Dichloro-2-fluoropropane	816-38-6	Intentional addition	chemical products
3893	Dibutyltin oxide	818-08-6	Contains (regardless of intentional or impurities)	chemical products
3894	2-Hydroxyethyl acrylate	818-61-1	Contains (regardless of intentional or impurities)	chemical products
3895	Ethanolamine complex salt of boron trifluoride	818-91-7	Contains (regardless of intentional or impurities)	chemical products
3896	3-Fluoropropene	818-92-8	Contains (regardless of intentional or impurities)	chemical products
3897	1,1,3-trichloro-1-fluoropropane	818-99-5	Intentional addition / 1,000ppm	chemical products
3898	1,3-Dichloro-1,1-difluoropropane	819-00-1	Intentional addition / 1,000ppm	chemical products
3899	1,3-Dibutyl-1,3-difluorodistannoxane	819-21-6	Contains (regardless of intentional or impurities)	chemical products
3900	Copper O,O'-diethyl bis(dithiocarbamate)	819-74-9	Intentional addition / 1,000ppm	chemical products
3901	2-Butene, 1,4-dibromo-, (E)-	821-06-7	Contains (regardless of intentional or impurities)	chemical products
3902	2-Butyne, 1,4-dichloro-	821-10-3	Intentional addition / 1,000ppm	chemical products
3903	Ethanamine, 2-chloro-N-(2-chloroethyl)-, hydrochloride	821-48-7	Contains (regardless of intentional or impurities)	chemical products
3904	Hexane, 1,6-diisocyanato-	822-06-0	Contains (regardless of intentional or impurities)	chemical products
3905	Sodium stearate	822-16-2	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
3906	Arsine, phenyl-	822-65-1	Contains (regardless of intentional or impurities)	chemical products
3907	Hydroxyl-2-pyridone	822-89-9	Intentional addition / 1,000ppm	chemical products
3908	1,3-Benzenediamine, 2-methyl-	823-40-5	Contains (regardless of intentional or impurities)	chemical products
3909	Boroxin, 2,4,6-trimethyl-	823-96-1	Intentional addition / 1%	chemical products
3910	Benzene, 1-(chloromethyl)-3-methoxy-	824-98-6	Contains (regardless of intentional or impurities)	chemical products
3911	Benzeneacetone, alpha-(hydroxyimino)-	825-52-5	Contains (regardless of intentional or impurities)	chemical products
3912	Manganese bis(4-hydroxybenzenesulphonate)	825-89-8	Contains (regardless of intentional or impurities)	chemical products
3913	1-(1-Cyclopropylvinyl)-4-fluorobenzene	827-87-2	Intentional addition / 1,000ppm	chemical products
3914	Diphenylarsine	829-63-4	Contains (regardless of intentional or impurities)	chemical products
3915	1,3-Naphthalenedisulfonic acid, 7-amino-, disodium salt	842-17-1	Contains (regardless of intentional or impurities)	chemical products
3916	1-Pyrenyldiazonium tetrafluoroborate	850-06-5	Intentional addition / 1%	chemical products
3917	Aluminum methanolate	865-31-6	Intentional addition / 1,000ppm	chemical products
3918	Aluminum hydrodimethyl-	865-37-2	Intentional addition / 1,000ppm	chemical products
3919	Cadmium dithiocyanate	865-38-3	Contains (regardless of intentional or impurities)	chemical products
3920	1-Butene, 3-bromo-3-methyl-	865-58-7	Intentional addition / 1,000ppm	chemical products
3921	1-Dodecanol, 3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,12-heneicosylfluoro-	865-86-1	Contains (regardless of intentional or impurities)	chemical products
3922	1-Pentene, 3-bromo-3-methyl-	866-52-4	Intentional addition / 1,000ppm	chemical products
3923	Diethyltin dichloride	866-55-7	Contains (regardless of intentional or impurities)	chemical products
3924	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, cobalt(2+) salt (2:3)	866-81-9	Intentional addition / 1%	chemical products
3925	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, copper(2+) salt (1:2)	866-82-0	Intentional addition / 1,000ppm	chemical products
3926	Demeton-O-methyl	867-27-6	Contains (regardless of intentional or impurities)	chemical products
3927	Dysprosium, [mu.-[ethanedioato(2-)-O,O'-O']bis[ethanedioato(2-)-O,O']di-	867-62-9	Intentional addition	chemical products
3928	Erbium, [mu.-[ethanedioato(2-)-O,O'-O']bis[ethanedioato(2-)-O,O']di-	867-63-0	Intentional addition	chemical products
3929	Gadolinium, [mu.-[ethanedioato(2-)-O,O'-O']bis[ethanedioato(2-)-O,O']di-	867-64-1	Intentional addition / 1,000ppm	chemical products
3930	Yttrium, [mu.-[ethanedioato(2-)-O,O'-O']bis[ethanedioato(2-)-O,O']di-	867-68-5	Intentional addition / 1,000ppm	chemical products
3931	Vinylamine, 1,2,2-trichloro-N,N-diethyl-, perchlorate	868-38-2	Intentional addition / 1,000ppm	chemical products
3932	3-Aminoprop-1-ene-1,1,3-tricarbonitrile	868-54-2	Intentional addition	chemical products
3933	Borane, chlorodimethoxy-	868-81-5	Intentional addition / 1%	chemical products
3934	Allylidene diacetate	869-29-4	Intentional addition / 1%	chemical products
3935	Trioctyltin hydride	869-59-0	Contains (regardless of intentional or impurities)	chemical products
3936	2-Pentene, 1-bromo-3-methyl-	869-72-7	Intentional addition / 1,000ppm	chemical products
3937	Diocetyl tin oxide	870-08-6	Contains (regardless of intentional or impurities)	chemical products
3938	Ethanamine, 2-chloro-, hydrochloride	870-24-6	Contains (regardless of intentional or impurities)	chemical products
3939	2-Butene, 1-bromo-3-methyl-	870-63-3	Intentional addition / 1,000ppm	chemical products
3940	Diethylaluminum hydride	871-27-2	Intentional addition / 1,000ppm	chemical products
3941	Dibutylhydroaluminum	871-89-6	Intentional addition / 1,000ppm	chemical products
3942	Benzonitrile, 2-chloro-	873-32-5	Contains (regardless of intentional or impurities)	chemical products
3943	Borane, dichlorophenyl-	873-51-8	Intentional addition / 1%	chemical products
3944	m-Hydroxybenzonitrile	873-62-1	Intentional addition	chemical products
3945	Benzonitrile, 4-amino-	873-74-5	Intentional addition	chemical products
3946	Benzonitrile, 4-methoxy-	874-90-8	Contains (regardless of intentional or impurities)	chemical products
3947	2,6-Dichloro-4-methylnicotinonitrile	875-35-4	Intentional addition	chemical products
3948	Terbutryn	886-50-0	Contains (regardless of intentional or impurities)	chemical products
3949	Triphenyltin hydride	892-20-6	Contains (regardless of intentional or impurities)	chemical products
3950	Triphenyltin iodide	894-09-7	Contains (regardless of intentional or impurities)	chemical products
3951	Dihydroxytriphentylantimony	896-29-7	Contains (regardless of intentional or impurities)	chemical products
3952	Methyl 1,2,5,6-tetrahydro-1-methylnicotinate, mono[(3-acetamido-4-hydroxyphenyl)arsenate]	900-77-6	Contains (regardless of intentional or impurities)	chemical products
3953	3-Ethyl-2-[2-[(3-ethyl-3H-benzoselenazol-2-ylidene)methyl]but-1-enyl]benzoselenazolium iodide	909-64-8	Contains (regardless of intentional or impurities)	chemical products
3954	Triphenyltin benzoate	910-06-5	Contains (regardless of intentional or impurities)	chemical products
3955	Tetrabutylammonio, salt with 2,4,6-trinitrophenol (1:1)	914-45-4	Contains (regardless of intentional or impurities)	chemical products
3956	Diphenoxyate	915-30-0	Intentional addition	chemical products
3957	Cyanic acid, sodium salt	917-61-3	Contains (regardless of intentional or impurities)	chemical products
3958	Acetic acid, cobalt(3+) salt	917-69-0	Intentional addition / 1,000ppm	chemical products
3959	3,3-Dimethylbutyne	917-92-0	Contains (regardless of intentional or impurities)	chemical products
3960	(Acetoxy)trichlorostannane	919-29-8	Contains (regardless of intentional or impurities)	chemical products
3961	Propionitrile, 3-(triethoxysilyl)-	919-31-3	Intentional addition	chemical products
3962	Demeton-S-methyl	919-86-8	Contains (regardless of intentional or impurities)	chemical products
3963	Triglycine selenate	920-25-2	Contains (regardless of intentional or impurities)	chemical products
3964	2-Propenenitrile, 2-chloro-	920-37-6	Intentional addition / 1%	chemical products
3965	2,3,4-Trimethylhexane	921-47-1	1,000ppm	chemical products
3966	Heptane, 3,4-dimethyl-	922-28-1	Contains (regardless of intentional or impurities)	chemical products
3967	2-Ethylacrylaldehyde	922-63-4	Contains (regardless of intentional or impurities)	chemical products
3968	Barium silver 2-(phosphonatooxy)acrylate	923-14-8	Contains (regardless of intentional or impurities)	chemical products
3969	Indium, triethyl-	923-34-2	1%	chemical products
3970	N-Nitrosodi-n-butylamine	924-18-3	Contains (regardless of intentional or impurities)	chemical products
3971	Nitrous acid, 1-methylpropyl ester	924-43-6	Contains (regardless of intentional or impurities)	chemical products
3972	Acetic acid, oxo-ethyl ester	924-44-7	Contains (regardless of intentional or impurities)	chemical products
3973	Neopentylacetate	926-41-0	1,000ppm	chemical products
3974	Arsonous dichloride, propyl-	926-53-4	Contains (regardless of intentional or impurities)	chemical products
3975	Dimethylaminoacetone	926-64-7	Contains (regardless of intentional or impurities)	chemical products
3976	Heptane, 3,5-dimethyl-	926-82-9	Contains (regardless of intentional or impurities)	chemical products
3977	2-Pentene, 1-bromo-4-methyl-	927-53-7	1,000ppm	chemical products
3978	Ethanaminium, 2-(acetoxy)-N,N,N-trimethyl-, perchlorate	927-86-6	1,000ppm	chemical products
3979	Ethanamine, 2,2-[1,2-ethanediyloxy]bis-	929-59-9	1,000ppm	chemical products
3980	N-Nitrosopyrrolidine	930-55-2	Contains (regardless of intentional or impurities)	chemical products
3981	Cyclohexanecarbonitrile, 1-hydroxy-	931-97-5	Intentional addition	chemical products
3982	Benzoic acid, cobalt(2+) salt	932-69-4	Intentional addition / 1%	chemical products
3983	2,4,6-Trichloroborazine	933-18-6	1%	chemical products
3984	4,7-Methano-1H-indene, 3a,4,7,7a-tetrahydro-, (3aR,4R,7S,7aS)-ref-	933-60-8	1%	chemical products
3985	1-Phenylcyclopropanecarbonitrile	935-44-4	Contains (regardless of intentional or impurities)	chemical products
3986	[(2-Chloroethyl)sulphonyl]benzene	938-09-0	1%	chemical products
3987	4-Chloro-3-nitrobenzonitrile	939-80-0	Intentional addition	chemical products
3988	Benzenesulfonyl azide, 4-methyl-	941-55-9	Contains (regardless of intentional or impurities)	chemical products
3989	1H-Pyrrole-2,5-dione, 1-phenyl-	941-69-5	Contains (regardless of intentional or impurities)	chemical products
3990	6-Methoxybenzothiazole-2-carbonitrile	943-03-3	Intentional addition	chemical products
3991	Fonofos	944-22-9	Contains (regardless of intentional or impurities)	chemical products
3992	Methyldiphenylarsine	945-48-2	Contains (regardless of intentional or impurities)	chemical products
3993	Pentan-3-yl 4-methylbenzenesulfonate	950-25-4	1%	chemical products
3994	Methidathion	950-37-8	Contains (regardless of intentional or impurities)	chemical products
3995	Borane, triphenyl-	960-71-4	1%	chemical products
3996	Pyridine-triphenylborane (1:1)	971-66-4	1%	chemical products
3997	1H-1,2,4-Triazole, 1-(triphenylstannyl)-	974-29-8	Contains (regardless of intentional or impurities)	chemical products
3998	Borazine, 2,4,6-triphenyl-	976-28-3	1%	chemical products
3999	Benzoselenazolium, 3-ethyl-2-[5-(3-ethyl-2(3H)-benzoselenazolydene)-1,3-pentadienyl]-, ethyl sulfate	988-93-2	Contains (regardless of intentional or impurities)	chemical products
4000	C.I. Direct Red 2, disodium salt	992-59-6	1,000ppm	chemical products
4001	Formic acid, thallium(I+) salt	992-98-3	Contains (regardless of intentional or impurities)	chemical products
4002	Manganese(3+) acetate	993-02-2	Contains (regardless of intentional or impurities)	chemical products
4003	Stannane, trichloromethyl-	993-16-8	Contains (regardless of intentional or impurities)	chemical products
4004	(Dimethylamino)trimethylstannane	993-50-0	Contains (regardless of intentional or impurities)	chemical products
4005	Butane, 2-methoxy-2-methyl-	994-05-8	Contains (regardless of intentional or impurities)	chemical products
4006	Triethyltin chloride	994-31-0	Contains (regardless of intentional or impurities)	chemical products
4007	Triethyltin hydroxide	994-32-1	Contains (regardless of intentional or impurities)	chemical products
4008	Bis(triethylstannyl)acetylene	994-71-8	Contains (regardless of intentional or impurities)	chemical products
4009	Tributylstannylacetylene	994-89-8	1,000ppm	chemical products
4010	Dibutyltin dibromide	996-08-7	Contains (regardless of intentional or impurities)	chemical products
4011	Terbium, [mu.-[ethanedioato(2-)-O,O'-O']bis[ethanedioato(2-)-O,O']di-	996-33-8	Intentional addition / 1,000ppm	chemical products
4012	Ytterbium, [mu.-[ethanedioato(2-)-O,O'-O']bis[ethanedioato(2-)-O,O']di-	996-34-9	Intentional addition / 1,000ppm	chemical products
4013	Silamine, 1,1,1-trimethyl-N-(trimethylsilyl)-N-(trimethylstannyl)-	996-37-2	Contains (regardless of intentional or impurities)	chemical products
4014	Triethyltin	997-50-2	Contains (regardless of intentional or impurities)	chemical products
4015	Heptane, 4-bromo-	998-93-6	1,000ppm	chemical products
4016	Octane, 4-bromo-	999-06-4	1,000ppm	chemical products
4017	Octane, 4-chloro-	999-07-5	1,000ppm	chemical products
4018	3-Chloroheptane	999-52-0	1,000ppm	chemical products
4019	2-Hydroxypropyl acrylate	999-61-1	Contains (regardless of intentional or impurities)	chemical products
4020	Octane, 3-bromo-	999-64-4	1,000ppm	chemical products
4021	Chloromequat chloride	999-81-5	Contains (regardless of intentional or impurities)	chemical products
4022	2-Chloroheptane	1001-89-4	1,000ppm	chemical products
4023	Dibutyltin	1002-53-5	Contains (regardless of intentional or impurities)	chemical products
4024	Cobalt distearate	1002-88-6	Intentional addition / 1,000ppm	chemical products
4025	Thiophene-2-carbonitrile	1003-31-2	Contains (regardless of intentional or impurities)	chemical products
4026	Naphthalene, decahydro-1-isopropyl-	1010-74-8	Intentional addition / 1%	chemical products
4027	alpha-Cyanocinnamic acid	1011-92-3	Intentional addition	chemical products
4028	Simetryn	1014-70-6	Contains (regardless of intentional or impurities)	chemical products
4029	2,3-Naphthalenedicarbonitrile, 1,4-dihydroxy-	1018-79-7	Intentional addition	chemical products
4030	5-Methoxy-N,N-dimethyl-1H-indole-3-ethylamine	1019-45-0	Intentional addition	chemical products
4031	Heptachlor epoxide	1024-57-3	Contains (regardless of intentional or impurities)	chemical products
4032	4-Nitrobenzoic acid 4-nitrophenyl ester	1037-31-6	Contains (regardless of intentional or impurities)	chemical products
4033	3-ethyl-2-[3-(3-ethyl-3H-benzoselenazol-2-ylidene)prop-1-enyl]benzoselenazolium iodide	1049-38-3	Contains (regardless of intentional or impurities)	chemical products
4034	Butyric acid, 2-amino-4-sulfo-, compound with strychnine (1:1)	1061-27-4	Contains (regardless of intentional or impurities)	chemical products
4035	Hexaphenyldistannane	1064-10-4	Contains (regardless of intentional or impurities)	chemical products
4036	Chromic acetate	1066-30-4	Contains (regardless of intentional or impurities)	chemical products
4037	Bromotrimethylstannane	1066-44-0	Contains (regardless of intentional or impurities)	chemical products
4038	Triethyltin chloride	1066-45-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
4039	Ethyltin trichloride	1066-57-5	Contains (regardless of intentional or impurities)	chemical products
4040	3-Ethyl-3-methylpentane	1067-08-9	Contains (regardless of intentional or impurities)	chemical products
4041	Plumbane, chlorotriethyl-	1067-14-7	Contains (regardless of intentional or impurities)	chemical products
4042	3,3-Diethylpentane	1067-20-5	1,000ppm	chemical products
4043	Distannoxane, hexapropyl-	1067-29-4	Contains (regardless of intentional or impurities)	chemical products
4044	Dibutyltin diacetate	1067-33-0	Contains (regardless of intentional or impurities)	chemical products
4045	Butanenitrile, 4-(triethoxysilyl)-	1067-47-6	Intentional addition	chemical products
4046	Tri-n-butyltin methanolate	1067-52-3	Contains (regardless of intentional or impurities)	chemical products
4047	Stannane, dibutylmethoxy-	1067-55-6	Contains (regardless of intentional or impurities)	chemical products
4048	Tributyltin hydroxide	1067-57-6	Contains (regardless of intentional or impurities)	chemical products
4049	Heptane, 4,4-dimethyl-	1068-19-5	Contains (regardless of intentional or impurities)	chemical products
4050	Dioxium oxalate	1068-63-9	Intentional addition / 1,000ppm	chemical products
4051	2,4-Dimethyl-3-ethylpentane	1068-87-7	1,000ppm	chemical products
4052	2,3,5-Trimethylhexane	1069-53-0	1,000ppm	chemical products
4053	Aluminum, trioctyl-	1070-00-4	1,000ppm	chemical products
4054	Propane, 1,1,1,3-tetrachloro-	1070-78-6	1,000ppm	chemical products
4055	Pentane, 2,2,4,4-tetramethyl-	1070-87-7	1,000ppm	chemical products
4056	Butane, 1,1,1,3,4-pentachloro-	1071-08-5	1,000ppm	chemical products
4057	Propanenitrile, 3-(dichloromethylsilyl)-	1071-21-2	Intentional addition	chemical products
4058	Propanenitrile, 3-(trichlorosilyl)-	1071-22-3	Intentional addition	chemical products
4059	2,2-Dimethylheptane	1071-26-7	Contains (regardless of intentional or impurities)	chemical products
4060	Butanenitrile, 4-(trichlorosilyl)-	1071-27-8	Intentional addition	chemical products
4061	1-Butanol, zirconium(4+) salt	1071-76-7	Contains (regardless of intentional or impurities)	chemical products
4062	Heptane, 2,6-dimethyl-	1072-05-5	1,000ppm	chemical products
4063	Octadecanoic acid, lead(2+) salt (2:1)	1072-35-1	Contains (regardless of intentional or impurities)	chemical products
4064	1-Fluoro-2-bromobenzene	1072-85-1	1,000ppm	chemical products
4065	1-Fluoro-3-bromobenzene	1073-06-9	1,000ppm	chemical products
4066	1-Bromo-2,3,4,5-tetrafluorobenzene	1074-91-5	1,000ppm	chemical products
4067	Propanenitrile, 3-(phenylamino)-	1075-76-9	Intentional addition	chemical products
4068	Benzene-d6	1076-43-3	1,000ppm	chemical products
4069	Methanesulfenamide, 1,1-dichloro-N-[(dimethylamino)sulfonyl]-1-fluoro-N-phenyl-	1085-98-9	Contains (regardless of intentional or impurities)	chemical products
4070	1,4-Dicyclohexylbenzene	1087-02-1	Intentional addition / 1%	chemical products
4071	Triphenyl borate	1089-03-0	1%	chemical products
4072	1-Naphthalenesulfonic acid, 2-[(2-hydroxy-1-naphthalenyl)azo]-, barium salt (2:1)	1103-38-4	Contains (regardless of intentional or impurities)	chemical products
4073	Thiocyanic acid, copper(1+) salt	1111-67-7	Contains (regardless of intentional or impurities)	chemical products
4074	Beryllium diformate	1111-71-3	Contains (regardless of intentional or impurities)	chemical products
4075	1,1-Dichloro-2,2-difluoropropane	1112-01-2	Intentional addition	chemical products
4076	1,1,1-Trichloro-2,2-difluoropropane	1112-05-6	Intentional addition	chemical products
4077	1,1,3-Trichloro-2,2-difluoropropane	1112-13-6	Intentional addition	chemical products
4078	1,1,3,3-Tetrachloro-2,2-difluoropropane	1112-14-7	Intentional addition	chemical products
4079	1,3-Dichloro-2,2-difluoropropane	1112-36-3	Intentional addition	chemical products
4080	Tetraylstanthane	1112-56-7	Contains (regardless of intentional or impurities)	chemical products
4081	Bis(triethyltin) oxide	1112-63-6	Contains (regardless of intentional or impurities)	chemical products
4082	Ethanedioic acid, diammonium salt	1113-38-8	Intentional addition / 1,000ppm	chemical products
4083	Tri-sec-butylborane	1113-78-6	1,000ppm	chemical products
4084	Borane, tris(2-methylpropyl)-	1116-39-8	1,000ppm	chemical products
4085	N-Nitrosodiphenylamine	1116-54-7	Contains (regardless of intentional or impurities)	chemical products
4086	Borane, tripropyl-	1116-61-6	1,000ppm	chemical products
4087	Tributyl aluminum	1116-70-7	Contains (regardless of intentional or impurities)	chemical products
4088	Aluminum, trihexyl-	1116-73-0	1,000ppm	chemical products
4089	Acetic acid, cyano-, 1,1-dimethylethyl ester	1116-98-9	Intentional addition	chemical products
4090	Octane, 3-chloro-	1117-79-9	1,000ppm	chemical products
4091	Copper acetylacetonate	1117-84-8	1,000ppm	chemical products
4092	Trimethyltin azide	1118-03-2	1,000ppm	chemical products
4093	Trimethyltin acetate	1118-14-5	Contains (regardless of intentional or impurities)	chemical products
4094	Openitrytin dichloride	1118-42-9	Contains (regardless of intentional or impurities)	chemical products
4095	Butyltrichlorostannane	1118-46-3	Contains (regardless of intentional or impurities)	chemical products
4096	2-Butenenitrile, 3-amino-	1118-61-2	Intentional addition	chemical products
4097	1-Pentene, 5-bromo-	1119-51-3	1,000ppm	chemical products
4098	3-Hexenedinitrile	1119-85-3	Intentional addition	chemical products
4099	1-Octene, 1-bromo-	1119-88-6	1,000ppm	chemical products
4100	Decan-2-ol	1120-06-5	1%	chemical products
4101	9-Octadecenoic acid (Z)-, copper(2+) salt	1120-44-1	Intentional addition / 1,000ppm	chemical products
4102	Iron trioleate	1120-45-2	1%	chemical products
4103	1H-Imidazole-4,5-dicarbonitrile	1122-28-7	Intentional addition	chemical products
4104	4-Aminophenylarsine oxide	1122-90-3	Intentional addition / 1%	chemical products
4105	Trichlorophenylstannane	1124-19-2	Contains (regardless of intentional or impurities)	chemical products
4106	Pyridine, 4-nitro-, 1-oxide	1124-33-0	Contains (regardless of intentional or impurities)	chemical products
4107	N-(n-Butyl)aniline	1126-78-9	Contains (regardless of intentional or impurities)	chemical products
4108	Methyl 4-cyanobenzoate	1129-35-7	Intentional addition	chemical products
4109	Carbamic acid, methyl-, 3-methylphenyl ester	1129-41-5	Contains (regardless of intentional or impurities)	chemical products
4110	1,1'-Selenobisbenzene	1132-39-4	Contains (regardless of intentional or impurities)	chemical products
4111	1,2,3,5-Tetrachloro-4,6-bis(chloromethyl)benzene	1133-57-9	1,000ppm	chemical products
4112	1,3,2-Dioxaborolane, 2,2'-(1,2-ethanediybis(oxyl))bis-	1135-51-9	1%	chemical products
4113	Dichlorodiphenylstannane	1135-99-5	Contains (regardless of intentional or impurities)	chemical products
4114	Arsine oxide, triphenyl-	1153-05-5	Contains (regardless of intentional or impurities)	chemical products
4115	Chlorotriphenylplumbane	1153-06-6	Contains (regardless of intentional or impurities)	chemical products
4116	Acetoxytriphenylplumbane	1162-06-7	Contains (regardless of intentional or impurities)	chemical products
4117	Propanedinitrile, (2,4,7-trinitro-9H-fluoren-9-ylidene)-	1172-02-7	Intentional addition	chemical products
4118	Stannane, chlorotris(2-methyl-2-phenylpropyl)-	1178-79-6	Contains (regardless of intentional or impurities)	chemical products
4119	2-Fluoropropene	1184-60-7	1,000ppm	chemical products
4120	Carbonic acid, copper(2+) salt (1:1)	1184-64-1	Intentional addition / 1,000ppm	chemical products
4121	Hydrazine, sulfate	1184-66-3	Contains (regardless of intentional or impurities)	chemical products
4122	Ferric ammonium citrate	1185-57-5	Intentional addition / 1%	chemical products
4123	Stannane, dibutylbis(dodecylthio)-	1185-81-5	Contains (regardless of intentional or impurities)	chemical products
4124	Ethanedioic acid, monosodium salt	1186-49-8	Intentional addition / 1,000ppm	chemical products
4125	Neodymium, [mu.-[ethanedioato(2-)-]kappa.O1.kappa.O2':kappa.O1'.kappa.O2]bis[ethanedioato(2-)-]kappa.O1.kappa.O2]di-	1186-50-1	Intentional addition / 1,000ppm	chemical products
4126	Pentane, 2,2,3,4-tetramethyl-	1186-53-4	1,000ppm	chemical products
4127	Acetyl propane dinitrile	1187-11-7	Intentional addition	chemical products
4128	2-Butenedinitrile, 2,3-diamino-, (Z)-	1187-42-4	Contains (regardless of intentional or impurities)	chemical products
4129	Chromic acid (H2CrO4), bis(1,1-dimethylethyl) ester	1189-85-1	Contains (regardless of intentional or impurities)	chemical products
4130	Butanenitrile, 4-(dichloromethylsilyl)-	1190-16-5	Intentional addition	chemical products
4131	Butane, 1,3-dichloro-	1190-22-3	1,000ppm	chemical products
4132	Diisobutylaluminum hydride	1191-15-7	1,000ppm	chemical products
4133	Octane, 2-bromo-, (S)-	1191-24-8	1,000ppm	chemical products
4134	Octadecanoic acid, barium cadmium salt (4:1:1)	1191-79-3	Contains (regardless of intentional or impurities)	chemical products
4135	4,5-dichloro-3H-1,2-dithiol-3-one	1192-52-5	1,000ppm	chemical products
4136	1-Bromo-2,4-dichlorobenzene	1193-72-2	1,000ppm	chemical products
4137	Benzonitrile, 4-fluoro-	1194-02-1	Contains (regardless of intentional or impurities)	chemical products
4138	Benzonitrile, 2,6-dichloro-	1194-65-6	Contains (regardless of intentional or impurities)	chemical products
4139	1,3-Dichloro-2-nitrobenzene	1194-66-7	1%	chemical products
4140	1,3,2-Dioxaborolane, 2-methoxy-4,4,5,5-tetramethyl-	1195-66-0	1%	chemical products
4141	4-(Dimethylamino)benzonitrile	1197-19-9	Intentional addition	chemical products
4142	1-Isouquinolinecarbonitrile	1198-30-7	Intentional addition	chemical products
4143	Diphenyltellurium	1202-36-4	Contains (regardless of intentional or impurities)	chemical products
4144	4-Bromo-3-oxo-N-phenylbutanamide	1205-74-9	Contains (regardless of intentional or impurities)	chemical products
4145	1-(4-Methoxyphenyl)cyclopentane carbonitrile	1208-15-1	Intentional addition	chemical products
4146	9-Anthracene carbonitrile	1210-12-4	Intentional addition	chemical products
4147	9,10-Anthracenedi carbonitrile	1217-45-4	Intentional addition	chemical products
4148	2-Naphthalenol, 1-[(2-methoxyphenyl)azo]-	1229-55-6	Intentional addition / 100ppm	chemical products
4149	Bis(triphenyltin) oxide	1262-21-1	Contains (regardless of intentional or impurities)	chemical products
4150	Stannane, tetrakis(2-methyl-2-phenylpropyl)-	1262-78-8	Contains (regardless of intentional or impurities)	chemical products
4151	Chromocene	1271-24-5	1,000ppm	chemical products
4152	Dicyclopenta-2,4-dien-1-ylmanganese	1271-27-8	Contains (regardless of intentional or impurities)	chemical products
4153	Nickelocene	1271-28-9	Contains (regardless of intentional or impurities)	chemical products
4154	Carboxyferrocene	1271-42-7	1%	chemical products
4155	Vinylferrocene	1271-51-8	1%	chemical products
4156	Bis(eta.6-benzene)chromium	1271-54-1	1,000ppm	chemical products
4157	Ferrocene, acetyl-	1271-55-2	1%	chemical products
4158	Ferrocene, [(dimethylamino)methyl]-	1271-86-9	1%	chemical products
4159	Butylferrocene	1271-94-9	1%	chemical products
4160	Valerylferrocene	1272-29-3	1%	chemical products
4161	Ferrocene, benzoyl-	1272-44-2	1%	chemical products
4162	Ferrocene, chloromercuri-	1273-75-2	Contains (regardless of intentional or impurities)	chemical products
4163	Ferrocene, ethyl-	1273-89-8	1%	chemical products
4164	Ferrocene, pentyl-	1274-00-6	1%	chemical products
4165	1,1'-Dibutylferrocene	1274-08-4	1%	chemical products
4166	Cobaltocene	1277-43-6	Intentional addition / 1,000ppm	chemical products
4167	Vanadocene	1277-47-0	Intentional addition / 1%	chemical products
4168	Neopentylferrocene	1277-58-3	1%	chemical products
4169	Ferrocenium tetrafluoroborate	1282-37-7	Intentional addition / 1%	chemical products
4170	Ferrocenium, (T-4)-tetrachloroferrate(1-)	1287-09-8	1%	chemical products
4171	Zirconium, dichlorobis(eta.5-2,4-cyclopentadien-1-yl)-	1291-32-3	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
4172	1,1'-Dimethylferrocene	1291-47-0	1%	chemical products
4173	Dichloride(eta.5-cyclopentadienide)oxidevanadium	1293-64-7	Contains (regardless of intentional or impurities)	chemical products
4174	1,1'-Ferrocenedicarboxylic acid	1293-87-4	1%	chemical products
4175	Bis(methylcyclopentadienyl)nickel(II)	1293-95-4	Contains (regardless of intentional or impurities)	chemical products
4176	Tris(eta.5-cyclopenta-2,4-dien-1-yl)yttrium	1294-07-1	1%	chemical products
4177	Bis(1,5-cyclooctadiene)nickel	1295-35-8	Contains (regardless of intentional or impurities)	chemical products
4178	Aniline, oxo(tartrato)antimonate(1-)	1300-14-7	Contains (regardless of intentional or impurities)	chemical products
4179	Nonylphenol (mixed isomers)	1300-16-9	Intentional addition / 1%	chemical products
4180	Strychnine, compound with tetrahydrogen hexacyanoferrate(4-)(1:1), monohydrate	1300-19-2	Contains (regardless of intentional or impurities)	chemical products
4181	Dichloroethanes	1300-21-6	1,000ppm	chemical products
4182	Barium bis(hydroxybenzenesulphonate)	1300-37-4	Contains (regardless of intentional or impurities)	chemical products
4183	Benzeneamine, or, air-dimethyl-	1300-73-8	Contains (regardless of intentional or impurities)	chemical products
4184	Benzene-sulfonic acid, (phenylamino)-, barium salt	1300-92-1	Contains (regardless of intentional or impurities)	chemical products
4185	Strychnine nlycrophosphate hexahydrate	1301-26-4	Contains (regardless of intentional or impurities)	chemical products
4186	1,2,3-Propanetriol, mono(dihydrogen phosphate), iron(3+) salt (3:2)	1301-70-8	1%	chemical products
4187	Silver subfluoride	1302-01-8	Contains (regardless of intentional or impurities)	chemical products
4188	Silver selenide (Ag2Se)	1302-09-6	Contains (regardless of intentional or impurities)	chemical products
4189	Sodium aluminate (NaAlO2)	1302-42-7	Contains (regardless of intentional or impurities)	chemical products
4190	Beryl	1302-52-9	Contains (regardless of intentional or impurities)	chemical products
4191	Corundum	1302-74-5	1%	chemical products
4192	Aluminum selenide (Al2Se3)	1302-82-5	Contains (regardless of intentional or impurities)	chemical products
4193	Gallium arsenide	1303-00-0	Contains (regardless of intentional or impurities)	chemical products
4194	Indium arsenide (InAs)	1303-11-3	Contains (regardless of intentional or impurities)	chemical products
4195	Nickel arsenide	1303-13-5	Contains (regardless of intentional or impurities)	chemical products
4196	Arsenopyrite	1303-18-0	Intentional addition / 100ppm	chemical products
4197	Rammelsbergite (NiAs2)	1303-22-6	Contains (regardless of intentional or impurities)	chemical products
4198	Arsenic disulfide	1303-32-8	Intentional addition / 1,000ppm	chemical products
4199	Arsenic sulfide (As2S3)	1303-33-9	Contains (regardless of intentional or impurities)	chemical products
4200	Arsenic sulfide (As2S5)	1303-34-0	Contains (regardless of intentional or impurities)	chemical products
4201	Arsenic selenide (As2Se3)	1303-36-2	Contains (regardless of intentional or impurities)	chemical products
4202	Arsenic pentaselenide	1303-37-3	Contains (regardless of intentional or impurities)	chemical products
4203	Zinc arsenate oxide (Zn5(AsO3)4O3) tetrahydrate	1303-39-5	Contains (regardless of intentional or impurities)	chemical products
4204	Hydrogen tetrachloroaurate(III) tetrahydrate	1303-50-0	Intentional addition	chemical products
4205	Gold oxide (Au2O3)	1303-58-8	Intentional addition	chemical products
4206	Gold sulfide (Au2S)	1303-60-2	Intentional addition	chemical products
4207	Gold sulfide (Au2S3)	1303-61-3	Intentional addition	chemical products
4208	Gold selenide	1303-62-4	Contains (regardless of intentional or impurities)	chemical products
4209	Tetaboron copper heptaoxide	1303-92-0	Intentional addition / 1,000ppm	chemical products
4210	Boric acid (H2B4O7), dilithium salt, pentahydrate	1303-94-2	1%	chemical products
4211	Barium oxide	1304-28-5	Contains (regardless of intentional or impurities)	chemical products
4212	Barium peroxide	1304-29-6	Contains (regardless of intentional or impurities)	chemical products
4213	Barium selenide (BaSe)	1304-39-8	Contains (regardless of intentional or impurities)	chemical products
4214	Barium silicide (BaSi2)	1304-40-1	Intentional addition	chemical products
4215	Beryllium nitride (Be3N2)	1304-54-7	Contains (regardless of intentional or impurities)	chemical products
4216	Beryllium oxide	1304-56-9	Contains (regardless of intentional or impurities)	chemical products
4217	Bismuth oxide (Bi2O3)	1304-76-3	Intentional addition / 1,000ppm	chemical products
4218	Bismuth telluride (Bi2Te3)	1304-82-1	Contains (regardless of intentional or impurities)	chemical products
4219	Calcium hydroxide	1305-62-0	Contains (regardless of intentional or impurities)	chemical products
4220	Calcium oxide	1305-78-8	Contains (regardless of intentional or impurities)	chemical products
4221	Calcium selenide (CaSe)	1305-84-6	Contains (regardless of intentional or impurities)	chemical products
4222	Cadmium selenide	1306-24-7	Contains (regardless of intentional or impurities)	chemical products
4223	Cadmium telluride (CdTe)	1306-25-8	Contains (regardless of intentional or impurities)	chemical products
4224	Sodium chloroplatinate	1307-82-0	Contains (regardless of intentional or impurities)	chemical products
4225	Cobalt(III) hydroxide	1307-86-4	Intentional addition / 1%	chemical products
4226	Cobalt oxide (CoO)	1307-86-6	Contains (regardless of intentional or impurities)	chemical products
4227	Cobalt selenide (CoSe)	1307-89-9	Contains (regardless of intentional or impurities)	chemical products
4228	Cobalt oxide (Co2O3)	1308-04-9	Intentional addition / 1,000ppm	chemical products
4229	Cobalt oxide (Co3O4)	1308-06-1	Intentional addition / 1,000ppm	chemical products
4230	Copper chromate oxide (Cu3CrO4O2), dihydrate	1308-09-4	Contains (regardless of intentional or impurities)	chemical products
4231	Chromium hydroxide (Cr(OH)3)	1308-14-1	Contains (regardless of intentional or impurities)	chemical products
4232	Chromite ore	1308-31-2	Contains (regardless of intentional or impurities)	chemical products
4233	Chromium oxide (Cr2O3)	1308-38-9	Contains (regardless of intentional or impurities)	chemical products
4234	Copper nitride (Cu3N)	1308-80-1	Intentional addition / 1,000ppm	chemical products
4235	Iron oxide (Fe2O3)	1309-37-1	Contains (regardless of intentional or impurities)	chemical products
4236	Magnetite (Fe3O4)	1309-38-2	1,000ppm	chemical products
4237	Hausmannite (Mn3O4)	1309-55-3	Contains (regardless of intentional or impurities)	chemical products
4238	Molybdenite	1309-56-4	Contains (regardless of intentional or impurities)	chemical products
4239	Antimony oxide (Sb2O3)	1309-64-4	Contains (regardless of intentional or impurities)	chemical products
4240	Iron selenide (FeSe)	1310-32-3	Contains (regardless of intentional or impurities)	chemical products
4241	Iron hydroxide sulfate (Fe4(OH)2(SO4)5)	1310-45-8	1%	chemical products
4242	Potassium hydroxide	1310-58-3	Contains (regardless of intentional or impurities)	chemical products
4243	Lithium hydroxide	1310-65-2	Contains (regardless of intentional or impurities)	chemical products
4244	Lithium hydroxide monohydrate	1310-66-3	Intentional addition / 1,000ppm	chemical products
4245	Sodium hydroxide	1310-73-2	Contains (regardless of intentional or impurities)	chemical products
4246	Pyrochroite (Mn(OH)2)	1310-97-0	Contains (regardless of intentional or impurities)	chemical products
4247	Manganite (Mn(OH)O) (mineral)	1310-98-1	Contains (regardless of intentional or impurities)	chemical products
4248	Tungstate (W12(OH)2O4010-), decaammonium, tetrahydrate	1311-93-9	1%	chemical products
4249	Antimony, compound with indium (1:1)	1312-41-0	Contains (regardless of intentional or impurities)	chemical products
4250	Indium oxide (In2O3)	1312-43-2	1%	chemical products
4251	Indium telluride (In2Te3)	1312-45-4	Contains (regardless of intentional or impurities)	chemical products
4252	Potassium selenide (K2Se)	1312-74-9	Contains (regardless of intentional or impurities)	chemical products
4253	Magnesium selenide (MgSe)	1313-04-8	Contains (regardless of intentional or impurities)	chemical products
4254	Manganese oxide (MnO2)	1313-13-9	Contains (regardless of intentional or impurities)	chemical products
4255	Manganese selenide (MnSe)	1313-22-0	Contains (regardless of intentional or impurities)	chemical products
4256	Molybdenum trioxide	1313-27-5	Contains (regardless of intentional or impurities)	chemical products
4257	Molybdenum oxide (Mo2O3)	1313-29-7	Contains (regardless of intentional or impurities)	chemical products
4258	Trisodium 12-molybdophosphate	1313-30-0	Contains (regardless of intentional or impurities)	chemical products
4259	Sodium peroxide	1313-60-6	Contains (regardless of intentional or impurities)	chemical products
4260	Sodium sulfide	1313-82-2	Contains (regardless of intentional or impurities)	chemical products
4261	Sodium sulfide, nonahydrate	1313-84-4	1,000ppm	chemical products
4262	Sodium selenide (Na2Se)	1313-85-5	Contains (regardless of intentional or impurities)	chemical products
4263	Nickel oxide (NiO)	1313-99-1	Contains (regardless of intentional or impurities)	chemical products
4264	Millerite (NiS)	1314-04-1	Contains (regardless of intentional or impurities)	chemical products
4265	Nickel selenide	1314-05-2	Contains (regardless of intentional or impurities)	chemical products
4266	Nickel oxide (Ni2O3)	1314-06-3	Contains (regardless of intentional or impurities)	chemical products
4267	Thallium oxide (Tl2O)	1314-12-1	Contains (regardless of intentional or impurities)	chemical products
4268	Zinc oxide (ZnO)	1314-13-2	Contains (regardless of intentional or impurities)	chemical products
4269	Thorium dioxide	1314-20-1	Contains (regardless of intentional or impurities)	chemical products
4270	Zirconium oxide (ZrO2)	1314-23-4	Contains (regardless of intentional or impurities)	chemical products
4271	Vanadium oxide (V2O3)	1314-34-7	Contains (regardless of intentional or impurities)	chemical products
4272	Yttrium oxide (Y2O3)	1314-36-9	1%	chemical products
4273	Antimony oxide (Sb2O5)	1314-60-9	1%	chemical products
4274	Tantalum oxide	1314-61-0	Contains (regardless of intentional or impurities)	chemical products
4275	Vanadium oxide (V2O5)	1314-62-1	Contains (regardless of intentional or impurities)	chemical products
4276	Uranyl sulfate	1314-64-3	Contains (regardless of intentional or impurities)	chemical products
4277	Phosphorus sulfide (P2S5)	1314-80-3	Contains (regardless of intentional or impurities)	chemical products
4278	Zinc phosphide (Zn3P2)	1314-84-7	Contains (regardless of intentional or impurities)	chemical products
4279	Phosphorus sulfide (P4S3)	1314-85-8	Contains (regardless of intentional or impurities)	chemical products
4280	Lead sulfide (PbS)	1314-87-0	Contains (regardless of intentional or impurities)	chemical products
4281	Tin sulfide	1314-95-0	Contains (regardless of intentional or impurities)	chemical products
4282	Zinc sulfide	1314-98-3	Intentional addition / 1,000ppm	chemical products
4283	Tin sulfide (SnS2)	1315-01-1	Contains (regardless of intentional or impurities)	chemical products
4284	Vanadium sulfide (V2S3)	1315-03-3	Intentional addition / 1%	chemical products
4285	Antimony sulfide (Sb2S5)	1315-04-4	Contains (regardless of intentional or impurities)	chemical products
4286	Antimony selenide (Sb2Se3)	1315-05-5	Contains (regardless of intentional or impurities)	chemical products
4287	Tin selenide (SnSe)	1315-06-6	Contains (regardless of intentional or impurities)	chemical products
4288	Strontium selenide (SrSe)	1315-07-7	Contains (regardless of intentional or impurities)	chemical products
4289	Zinc selenide (ZnSe)	1315-09-9	Contains (regardless of intentional or impurities)	chemical products
4290	Zinc telluride (ZnTe)	1315-11-3	Contains (regardless of intentional or impurities)	chemical products
4291	Ferrocene acetonitrile	1316-91-2	Intentional addition / 1,000ppm	chemical products
4292	1-Acetyl-2-ethylferrocene	1316-97-8	1%	chemical products
4293	Molybdenum sulfide (MoS2)	1317-33-5	Contains (regardless of intentional or impurities)	chemical products
4294	Manganese oxide (Mn2O3)	1317-34-6	Contains (regardless of intentional or impurities)	chemical products
4295	Manganese oxide (Mn3O4)	1317-35-7	Contains (regardless of intentional or impurities)	chemical products
4296	Copper oxide (CuO)	1317-38-0	Contains (regardless of intentional or impurities)	chemical products
4297	Copper(I) oxide	1317-39-1	Contains (regardless of intentional or impurities)	chemical products
4298	Copper(II) sulfide	1317-40-4	Intentional addition / 1,000ppm	chemical products
4299	Copper selenide (CuSe)	1317-41-5	Contains (regardless of intentional or impurities)	chemical products
4300	Cobalt(II) sulfide	1317-42-6	Contains (regardless of intentional or impurities)	chemical products
4301	Iron oxide (Fe3O4)	1317-61-9	1,000ppm	chemical products
4302	Anatase (TiO2)	1317-70-0	1,000ppm	chemical products
4303	Rutile (TiO2)	1317-80-2	1,000ppm	chemical products
4304	Silica, crystalline, tripoli	1317-95-9	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
4305	Valentinite	1317-98-2	Contains (regardless of intentional or impurities)	chemical products
4306	Colemanite (CaH(BO <sub>2</sub> ) <sub>3</sub> ·2H <sub>2</sub> O)	1318-33-8	1%	chemical products
4307	Datolite	1318-40-7	1%	chemical products
4308	Ulexite	1319-33-1	1%	chemical products
4309	Beryllium carbonate basic	1319-43-3	Contains (regardless of intentional or impurities)	chemical products
4310	Benzene, ethenyl-, monomethyl derivative	1319-73-9	1,000ppm	chemical products
4311	Glycerophosphoric acid, manganese salt, hydrate	1319-75-1	Contains (regardless of intentional or impurities)	chemical products
4312	Cresol, all isomers	1319-77-3	Contains (regardless of intentional or impurities)	chemical products
4313	Dichlorotetrafluoroethanes	1320-37-2	Intentional addition / 1,000ppm	chemical products
4314	1,2,3-Propanetriol, mono(dihydrogen phosphate), manganese(2+) salt (1:1)	1320-46-3	Contains (regardless of intentional or impurities)	chemical products
4315	Nitrotoluene (mixed isomers)	1321-12-6	Contains (regardless of intentional or impurities)	chemical products
4316	Benzene, diisocyanatomethyl-	1321-38-6	1%	chemical products
4317	Duimylbenzene	1321-74-0	1%	chemical products
4318	Methylnaphthalene	1321-94-4	1%	chemical products
4319	Sodium decylbenzenesulfonate	1322-98-1	1%	chemical products
4320	Strychnine glycerophosphate	1323-31-5	Contains (regardless of intentional or impurities)	chemical products
4321	Benzenesulfonic acid, [[4-[[4-(phenylamino)phenyl][4-(phenylimino)-2,5-cyclohexadien-1-ylidene]methyl]phenyl]amino]-	1324-76-1	Intentional addition / 100ppm	chemical products
4322	C.I. Direct Brown 33	1324-87-4	Intentional addition / 100ppm	chemical products
4323	Benzoic acid, 2-[(2-hydroxy-3,6-disulfo-1-naphthalenyl)azo]-, barium salt (1:2)	1325-16-2	Contains (regardless of intentional or impurities)	chemical products
4324	C.I. Pigment Red 66	1325-19-5	Intentional addition / 1,000ppm	chemical products
4325	C.I. Direct Black 71	1325-32-2	Intentional addition / 1,000ppm	chemical products
4326	Ethanaminium, N-[4-[[4-(diethylamino)phenyl]phenylmethylene]-2,5-cyclohexadien-1-ylidene]-N-ethyl-, molybdatetungstetatephosphate	1325-75-3	1,000ppm	chemical products
4327	Benzenamine, 4-[[4-(aminophenyl)(4-imino-2,5-cyclohexadien-1-ylidene)methyl]-2-methyl-, compound with molybdenum tungsten hydroxide oxide phosphate	1325-80-0	1%	chemical products
4328	Ethanaminium, N-[4-[[4-(diethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-ethyl-, molybdatetungstetatephosphate	1325-87-7	1,000ppm	chemical products
4329	C.I. Sulphur Green 1	1326-77-8	Intentional addition / 1,000ppm	chemical products
4330	C.I. Solubilised Sulphur Green 1	1326-78-9	Intentional addition / 1,000ppm	chemical products
4331	C.I. Sulphur Green 8	1326-80-3	Intentional addition / 1,000ppm	chemical products
4332	C.I. Solubilised Sulfur Brown 5	1327-02-2	Intentional addition / 1,000ppm	chemical products
4333	C.I. Sulphur Brown 15	1327-07-7	Intentional addition / 1,000ppm	chemical products
4334	C.I. Solubilised Sulphur Brown 15	1327-08-8	Intentional addition / 1,000ppm	chemical products
4335	Antimony oxides	1327-33-9	Contains (regardless of intentional or impurities)	chemical products
4336	Aluminum chloride, basic	1327-41-9	1%	chemical products
4337	Diantimony tritelluride	1327-50-0	Contains (regardless of intentional or impurities)	chemical products
4338	Arsenic acid	1327-52-2	Intentional addition / 1,000ppm	chemical products
4339	C.I. Sulphur Green 3	1327-73-7	Intentional addition / 1,000ppm	chemical products
4340	C.I. Solubilised Sulphur Green 3	1327-76-0	Intentional addition / 1,000ppm	chemical products
4341	C.I. Sulphur Brown 12	1327-86-2	Intentional addition / 1,000ppm	chemical products
4342	C.I. Solubilised Sulfur Brown 12	1327-89-5	Intentional addition / 1,000ppm	chemical products
4343	C.I. Solvent Blue 38	1328-51-4	1,000ppm	chemical products
4344	C.I. Pigment Green 7	1328-53-6	Intentional addition / 1,000ppm	chemical products
4345	C.I. Solvent Blue 25	1328-54-7	Intentional addition / 1,000ppm	chemical products
4346	Zinc chromate	1328-67-2	1,000ppm	chemical products
4347	Xylenes (o-, m-, p- isomers)	1330-20-7	Contains (regardless of intentional or impurities)	chemical products
4348	Copper, [C, C, C, C, C, C, C, C-octachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-	1330-37-6	Intentional addition / 1,000ppm	chemical products
4349	Cuprate(2-), [29H,31H-phthalocyanine-C, C-disulfonato(4-)-N29,N30,N31,N32]-, disodium	1330-38-7	Intentional addition / 1,000ppm	chemical products
4350	Cuprate(3-), [29H,31H-phthalocyanine-C, C-trisulfonato(5-)-N29,N30,N31,N32]-, trisodium	1330-39-8	Intentional addition / 1,000ppm	chemical products
4351	Copper, [C, C, C, C, C, C-tetraphenyl-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-	1330-40-1	Intentional addition / 1,000ppm	chemical products
4352	Chlorotrifluoroethane	1330-45-6	Intentional addition / 1,000ppm	chemical products
4353	Benzenesulfonic acid, dodecyl-, ion(1-)	1330-69-4	1%	chemical products
4354	Phosphoric acid, tris(methylphenyl) esters	1330-78-5	Contains (regardless of intentional or impurities)	chemical products
4355	Methylcyclohexanones	1331-22-2	Contains (regardless of intentional or impurities)	chemical products
4356	Benzene, chloroethyl-	1331-31-3	1,000ppm	chemical products
4357	[1,1'-Biphenyl]-4,4'-diamino, dichloro-	1331-47-1	1%	chemical products
4358	Dodecylbenzenesulfonic acid, ammonium salt	1331-61-9	1%	chemical products
4359	Zinc borate	1332-07-6	Intentional addition / 1%	chemical products
4360	Wolframite ((Fe <sub>0.2</sub> -0.8Mn <sub>0.2</sub> -0.8)WO <sub>4</sub> )	1332-08-7	Contains (regardless of intentional or impurities)	chemical products
4361	Potassium arsenite solution	1332-10-1	Contains (regardless of intentional or impurities)	chemical products
4362	Sulfuric acid, copper(2+) salt, basic	1332-14-5	Intentional addition / 1,000ppm	chemical products
4363	Asbestos	1332-21-4	Contains (regardless of intentional or impurities)	chemical products
4364	Tin oxide	1332-29-2	1,000ppm	chemical products
4365	Iron oxides	1332-37-2	1%	chemical products
4366	Basic copper chloride	1332-40-7	Intentional addition / 1,000ppm	chemical products
4367	Beryllium, hexakis[μ-(acetato-kappa O:kappa O')]-mu, 4-oxotetra-	1332-52-1	Contains (regardless of intentional or impurities)	chemical products
4368	Manganese trihydroxide	1332-62-3	Contains (regardless of intentional or impurities)	chemical products
4369	Copper chloride hydroxide (Cu <sub>2</sub> O(OH) <sub>3</sub> )	1332-65-6	Contains (regardless of intentional or impurities)	chemical products
4370	Cobalt sulfide (Co <sub>2</sub> S <sub>7</sub> )	1332-70-3	Intentional addition / 1%	chemical products
4371	Cobalt sulfide (Co <sub>2</sub> S <sub>3</sub> )	1332-71-4	Intentional addition / 100ppm	chemical products
4372	Boron potassium oxide (B <sub>4</sub> K <sub>2</sub> O <sub>7</sub> )	1332-77-0	1%	chemical products
4373	Antimony oxide (Sb <sub>2</sub> O <sub>4</sub> )	1332-81-6	Contains (regardless of intentional or impurities)	chemical products
4374	Cobalt chloride	1332-82-7	Intentional addition / 1%	chemical products
4375	Copper hydroxide sulfate (Cu <sub>4</sub> (OH) <sub>6</sub> (SO <sub>4</sub> ))	1333-22-8	Contains (regardless of intentional or impurities)	chemical products
4376	Antimony oxide sulfide	1333-30-8	Contains (regardless of intentional or impurities)	chemical products
4377	Antimony potassium oxide	1333-78-4	Contains (regardless of intentional or impurities)	chemical products
4378	Sodium fluoride (NaHF <sub>2</sub> )	1333-83-1	Contains (regardless of intentional or impurities)	chemical products
4379	Carbon black	1333-86-4	Contains (regardless of intentional or impurities)	chemical products
4380	Aluminum cobalt oxide (Al <sub>2</sub> CoO <sub>4</sub> )	1333-88-6	Intentional addition / 1,000ppm	chemical products
4381	Pyridylmercuric acetate	1334-77-6	Contains (regardless of intentional or impurities)	chemical products
4382	Copper iodide	1335-23-5	Intentional addition / 1,000ppm	chemical products
4383	alpha-D-Glucopyranoside, beta-D-fructofuranosyl, mixture with iron(2+) carbonate (1:1)	1335-56-4	1%	chemical products
4384	Dinitro-o-cresol (all isomers)	1335-85-9	Intentional addition / 1,000ppm	chemical products
4385	Chromium copper zinc oxide	1336-14-7	Contains (regardless of intentional or impurities)	chemical products
4386	Ammonium hydroxide	1336-21-6	Contains (regardless of intentional or impurities)	chemical products
4387	Diphenyl mercuric dodecyl succinate	1336-57-8	Contains (regardless of intentional or impurities)	chemical products
4388	Ferrocyanate	1336-80-7	1%	chemical products
4389	Manganese naphthenate	1336-93-2	Contains (regardless of intentional or impurities)	chemical products
4390	Chlorophyllins, copper potassium sodium	1337-20-8	Intentional addition / 1,000ppm	chemical products
4391	Copper naphthenate	1338-02-9	Contains (regardless of intentional or impurities)	chemical products
4392	Iron sorbitol-citric acid complex	1338-16-5	1%	chemical products
4393	Methyl ethyl ketone peroxide	1338-23-4	Contains (regardless of intentional or impurities)	chemical products
4394	Ammonium bifluoride	1341-49-7	Contains (regardless of intentional or impurities)	chemical products
4395	Tin chlorides	1344-13-4	Contains (regardless of intentional or impurities)	chemical products
4396	Silicic acid, zirconium(4+) salt	1344-21-4	Contains (regardless of intentional or impurities)	chemical products
4397	Aluminum oxide (Al <sub>2</sub> O <sub>3</sub> )	1344-28-1	Contains (regardless of intentional or impurities)	chemical products
4398	Stibamine glucoside	1344-34-9	Contains (regardless of intentional or impurities)	chemical products
4399	C.I. Pigment Orange 21	1344-38-3	Contains (regardless of intentional or impurities)	chemical products
4400	Manganese oxide (MnO)	1344-43-0	Contains (regardless of intentional or impurities)	chemical products
4401	Uranyl dioxide	1344-57-6	Contains (regardless of intentional or impurities)	chemical products
4402	Uranium trioxide	1344-58-7	Contains (regardless of intentional or impurities)	chemical products
4403	Uranium octaoxide	1344-59-8	Contains (regardless of intentional or impurities)	chemical products
4404	Copper chloride	1344-67-8	Intentional addition / 1,000ppm	chemical products
4405	Copper hydroxide	1344-69-0	Intentional addition / 1,000ppm	chemical products
4406	Copper oxide	1344-70-3	Intentional addition / 1,000ppm	chemical products
4407	Silicic acid, copper salt	1344-72-5	Intentional addition / 1,000ppm	chemical products
4408	Sulfuric acid, copper salt, basic	1344-73-6	Intentional addition / 1,000ppm	chemical products
4409	Copper zinc chromate oxide pentacosahydrate	1344-74-7	Contains (regardless of intentional or impurities)	chemical products
4410	Antimony sulfide (Sb <sub>2</sub> S <sub>3</sub> )	1345-04-6	Contains (regardless of intentional or impurities)	chemical products
4411	C.I. Pigment White 5	1345-05-7	Intentional addition / 1,000ppm	chemical products
4412	Cadmium mercury sulfide	1345-09-1	Contains (regardless of intentional or impurities)	chemical products
4413	C.I. Pigment Blue 28	1345-16-0	Intentional addition / 1,000ppm	chemical products
4414	Cobalt tin trioxide	1345-19-3	Contains (regardless of intentional or impurities)	chemical products
4415	C.I. Pigment Green 22	1345-20-6	Contains (regardless of intentional or impurities)	chemical products
4416	C.I. Pigment Red 109	1345-24-0	Intentional addition / 1,000ppm	chemical products
4417	beta-D-Glucopyranosiduronic acid, (3beta,4.alpha.,16.alpha.)-17-carboxy-16-hydroxy-23-oxo-28-norolean-12-en-3-yl	1393-03-9	Contains (regardless of intentional or impurities)	chemical products
4418	Bacillomycin	1395-21-7	Intentional addition / 1%	chemical products
4419	Bacitracin manganese	1405-99-8	Contains (regardless of intentional or impurities)	chemical products
4420	Dinoterb	1420-07-1	Contains (regardless of intentional or impurities)	chemical products
4421	Nicotine, D-tartrate	1421-32-5	Contains (regardless of intentional or impurities)	chemical products
4422	Strychnine hydrochloride	1421-86-9	Contains (regardless of intentional or impurities)	chemical products
4423	Boric acid, B-[3-(trifluoromethyl)phenyl]-	1423-26-3	Intentional addition / 1%	chemical products
4424	2-(Trifluoromethyl)benzeneboric acid	1423-27-4	Intentional addition / 1%	chemical products
4425	1,3-Dichloro-4-fluorobenzene	1435-48-9	Contains (regardless of intentional or impurities)	chemical products
4426	1,2-Dichloro-4-fluorobenzene	1435-49-0	Intentional addition / 1,000ppm	chemical products
4427	2-Bromo-1,4-dichlorobenzene	1435-50-3	Intentional addition / 1,000ppm	chemical products
4428	1,3-Dibromo-5-fluorobenzene	1435-51-4	Intentional addition / 1,000ppm	chemical products
4429	2,4-Dibromo-1-fluorobenzene	1435-53-6	Intentional addition / 1,000ppm	chemical products
4430	Quinoline-2-carbonitrile	1436-43-7	Intentional addition	chemical products
4431	Pentachlorophenyl acetate	1441-02-7	Contains (regardless of intentional or impurities)	chemical products
4432	4-Cyanoacetophenone	1443-80-7	Intentional addition	chemical products
4433	Acetamide, N-(aminocarbonyl)-2-cyano-	1448-98-2	Intentional addition	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
4434	Tetracyclohexylstannane	1449-55-4	Contains (regardless of intentional or impurities)	chemical products
4435	3-Bromo-2-methyl-1-propene	1458-98-6	Contains (regardless of intentional or impurities)	chemical products
4436	1,3,5-Tri-tert-butylbenzene	1460-02-2	Intentional addition / 1%	chemical products
4437	Tributyltin bromide	1461-23-0	Contains (regardless of intentional or impurities)	chemical products
4438	Stannane, tetrabutyl-	1461-25-2	Contains (regardless of intentional or impurities)	chemical products
4439	Selenomethionine	1464-42-2	Contains (regardless of intentional or impurities)	chemical products
4440	Alanine, 3,3'-diselenobis	1464-43-3	Contains (regardless of intentional or impurities)	chemical products
4441	Dipoxybutane	1464-53-5	Contains (regardless of intentional or impurities)	chemical products
4442	4-(2-Cyanoethyl)-4-nitroheptanedinitrile	1466-48-4	Intentional addition	chemical products
4443	9-Anthracenemethanol	1468-95-7	Contains (regardless of intentional or impurities)	chemical products
4444	2-Butene, 1,4-dichloro-, (Z)-	1476-11-5	Intentional addition / 1,000ppm	chemical products
4445	1,2-Benzenedimethanamine	1477-55-0	Intentional addition / 1%	chemical products
4446	Propanoic acid, ethyl ester, compound with trifluoroborane (1:1)	1481-38-5	Intentional addition / 1%	chemical products
4447	Diselenide, bis(phenylmethyl)	1482-82-2	Contains (regardless of intentional or impurities)	chemical products
4448	9-Methylcarbazole	1484-12-4	Contains (regardless of intentional or impurities)	chemical products
4449	9H-Carbazole, 9-ethyl-	1484-13-5	Contains (regardless of intentional or impurities)	chemical products
4450	Pyrylium, 2,4,6-triphenyl-, perchlorate	1484-88-4	Intentional addition / 1,000ppm	chemical products
4451	Diiodofluoromethane	1493-01-2	Intentional addition / 1,000ppm	chemical products
4452	Methanesulfonic acid, trifluoro-	1493-13-6	Intentional addition / 1%	chemical products
4453	Cyanogen fluoride	1495-50-7	Intentional addition / 1%	chemical products
4454	Diphénylphosphinic chloride	1499-21-4	Contains (regardless of intentional or impurities)	chemical products
4455	Arsonium, methyltriphenyl-, iodide	1499-33-8	Contains (regardless of intentional or impurities)	chemical products
4456	Methane, bromodifluoro-	1511-62-2	Contains (regardless of intentional or impurities)	chemical products
4457	1-Propene, 2-bromo-3,3-trifluoro-	1514-82-5	Intentional addition / 1%	chemical products
4458	Boron, trichloro(N,N-dimethylmethanamine)-, (T-4)-	1516-55-8	Intentional addition / 1%	chemical products
4459	Propanedinitrile, 2,2'-(2,5-cyclohexadiene-1,4-diyldiene)bis-	1518-16-7	Intentional addition	chemical products
4460	Chlorotrimethylplumbane	1520-78-1	Contains (regardless of intentional or impurities)	chemical products
4461	3-Methoxybenzonitrile	1527-89-5	Intentional addition	chemical products
4462	Tributylmethylstannane	1528-01-4	Contains (regardless of intentional or impurities)	chemical products
4463	Tribromobutyltin	1528-07-0	Intentional addition / 1,000ppm	chemical products
4464	Triethyltin phenoxide	1529-30-2	Contains (regardless of intentional or impurities)	chemical products
4465	3-Chlorophenylacetone	1529-41-5	Contains (regardless of intentional or impurities)	chemical products
4466	Aluminum, tricoisyl-	1529-57-3	Intentional addition / 1,000ppm	chemical products
4467	Aluminum, tritetradecyl-	1529-58-4	Intentional addition / 1,000ppm	chemical products
4468	Aluminum, tridodecyl-	1529-59-5	Intentional addition / 1,000ppm	chemical products
4469	Butane, 1,2,3,4-tetrabromo-	1529-68-6	Intentional addition / 1,000ppm	chemical products
4470	Piperidinocarbonitrile	1530-87-6	Intentional addition	chemical products
4471	Pyrridine-1-carbonitrile	1530-88-7	Intentional addition	chemical products
4472	Morpholine-4-carbonitrile	1530-89-8	Intentional addition	chemical products
4473	Acetamide, N-[5-bis(2-(acetyloxy)ethyl)amino]-2-[(2-chloro-4-nitrophenyl)azo]phenyl-	1533-78-4	Contains (regardless of intentional or impurities)	chemical products
4474	Triphenylantimony dibromide	1538-59-6	Contains (regardless of intentional or impurities)	chemical products
4475	Bis(acetato-O)-triphenylantimony	1538-62-1	Contains (regardless of intentional or impurities)	chemical products
4476	cis,cis'-Muconitrile	1557-59-1	Intentional addition	chemical products
4477	2-Bromo-1,3,4,5-tetrafluorobenzene	1559-86-0	Intentional addition / 1,000ppm	chemical products
4478	1-Bromo-2,3,5,6-tetrafluorobenzene	1559-88-2	Intentional addition / 1,000ppm	chemical products
4479	Propanoic acid, cobalt(2+) salt (2:1)	1560-69-6	Intentional addition / 1,000ppm	chemical products
4480	Carbofuran	1563-66-2	Contains (regardless of intentional or impurities)	chemical products
4481	9-Bromoanthracene	1564-64-3	Contains (regardless of intentional or impurities)	chemical products
4482	3-Decanol	1565-81-7	Intentional addition / 1%	chemical products
4483	Pentanedinitrile, 2-methylene-	1572-52-7	Intentional addition	chemical products
4484	Ethyl 2-cyanopropionate	1572-99-2	Intentional addition	chemical products
4485	1,2-Benzenediamine, 4-bromo-	1575-37-7	Contains (regardless of intentional or impurities)	chemical products
4486	Benzenesulfonic acid, 4-methyl-, hydrazide	1576-35-8	Contains (regardless of intentional or impurities)	chemical products
4487	2-Pentenal, (E)-	1576-87-0	Contains (regardless of intentional or impurities)	chemical products
4488	Trifuralin	1582-09-8	Contains (regardless of intentional or impurities)	chemical products
4489	Pentafluorophenylboronic acid	1582-24-7	Intentional addition / 1%	chemical products
4490	1,4-Dichloro-2-trichlorosilyl-2-butene	1586-88-5	Contains (regardless of intentional or impurities)	chemical products
4491	Methylum, triphenyl-, (OC-6-11)-hexachloroantimonate(1-)	1586-91-0	Contains (regardless of intentional or impurities)	chemical products
4492	Methane, dichlorodinitro-	1587-41-3	Intentional addition	chemical products
4493	Cobalt dioxanate	1588-79-0	Intentional addition / 1,000ppm	chemical products
4494	3-Nonene, 1-bromo-4-methyl-	1588-93-8	Intentional addition / 1,000ppm	chemical products
4495	2-Methoxy-1-propanol	1589-47-5	Contains (regardless of intentional or impurities)	chemical products
4496	[1,1'-Biphenyl]-4,4'-dicarbonitrile	1591-30-6	Intentional addition	chemical products
4497	1,2,2-Trichloropentafluoropropane	1599-41-3	Contains (regardless of intentional or impurities)	chemical products
4498	1,1,2,2,3-Pentachloro-1,3,3-trifluoropropane	1599-43-5	Intentional addition	chemical products
4499	1-Propene, 1,1,2,3,3-pentachloro-	1600-37-9	Intentional addition / 1,000ppm	chemical products
4500	Carbon oxide selenide	1603-84-5	Contains (regardless of intentional or impurities)	chemical products
4501	1-Chloro-1-fluoroethane	1615-75-4	Intentional addition / 1,000ppm	chemical products
4502	1,2-Diethylhydrazine	1615-80-1	Contains (regardless of intentional or impurities)	chemical products
4503	2-Chloropropionitrile	1617-17-0	Intentional addition	chemical products
4504	Propane, 1,1,1,2,2,3,3-heptafluoro-3-[(trifluoroethyl)oxy]-	1623-05-8	Contains (regardless of intentional or impurities)	chemical products
4505	Chromic acid (H2CrO4), bis(triphenylsilyl) ester	1624-02-8	Contains (regardless of intentional or impurities)	chemical products
4506	1,1,2,2-Diborane(4)tetramine, N1.N1.N1'.N1'.N2.N2.N2'.N2'-octamethyl-	1630-79-1	Intentional addition / 1%	chemical products
4507	Stannane, trimethyl-	1631-73-8	Contains (regardless of intentional or impurities)	chemical products
4508	Pyridine-3,4-dicarbonitrile	1633-44-9	Intentional addition	chemical products
4509	3-Chloropropanesulphonyl chloride	1633-82-5	Contains (regardless of intentional or impurities)	chemical products
4510	Methyl tert-butyl ether	1634-04-4	Contains (regardless of intentional or impurities)	chemical products
4511	Benzenamine, 5-chloro-2-nitro-	1635-61-6	Contains (regardless of intentional or impurities)	chemical products
4512	Vanadium, chlorodithioxyoxo-, (T-4)-	1635-99-0	Intentional addition / 1%	chemical products
4513	Thiophene-3-carbonitrile	1641-09-4	Intentional addition	chemical products
4514	1-Dodecanamine, N,N-dimethyl-, N-oxide	1643-20-5	Intentional addition / 1%	chemical products
4515	1,1,1,2,3,3-Hexachloro-2,3-difluoropropane	1645-71-2	Intentional addition	chemical products
4516	1,3,3,3-Tetrafluoropropylene	1645-83-6	Contains (regardless of intentional or impurities)	chemical products
4517	Butane, 1-bromo-3,3-dimethyl-	1647-23-0	Intentional addition / 1,000ppm	chemical products
4518	Pentane, 1-bromo-3-ethyl-	1647-24-1	Intentional addition / 1,000ppm	chemical products
4519	1,2-Dichloro-1,1-difluoroethane	1649-08-7	Contains (regardless of intentional or impurities)	chemical products
4520	1,1,2,3,3-Pentachloro-1,2,3-trifluoropropane	1652-74-0	Intentional addition	chemical products
4521	2,2-Dichloro-1,1,1,3,3,3-hexafluoropropane	1652-80-8	Intentional addition	chemical products
4522	1,1,3-Trichloro-1,2,2,3,3-pentafluoropropane	1652-81-9	Intentional addition	chemical products
4523	1,1,1,2,2-Pentachloro-3,3,3-trifluoropropane	1652-89-7	Intentional addition	chemical products
4524	Propane, 1,1,3,3-tetrachloro-	1653-17-4	Intentional addition / 1,000ppm	chemical products
4525	2-Ethylhexyl nitrite	1653-42-5	Intentional addition / 1,000ppm	chemical products
4526	3,3'-Oxydipropionitrile	1656-48-0	Contains (regardless of intentional or impurities)	chemical products
4527	Diphenyl diselenide	1666-13-3	Contains (regardless of intentional or impurities)	chemical products
4528	4,4'-Bis(chloromethyl)-1,1'-biphenyl	1667-10-3	Contains (regardless of intentional or impurities)	chemical products
4529	2,7-Bis(2-arsenophenylazo)-1,8-dihydroxynaphthalene-3,6-disulphonic acid	1668-00-4	Contains (regardless of intentional or impurities)	chemical products
4530	Bisphenol A diglycidyl ether	1675-84-3	Contains (regardless of intentional or impurities)	chemical products
4531	Azelaonitrile	1675-69-0	Intentional addition	chemical products
4532	(p-Chlorophenyl)metaboric acid	1679-18-1	Intentional addition / 1%	chemical products
4533	Vanadium, triethoxyoxo-, (T-4)-	1686-22-2	Intentional addition / 1%	chemical products
4534	Oxotripropoxyvanadium	1686-23-3	Intentional addition / 1%	chemical products
4535	lowmii	1689-83-4	Contains (regardless of intentional or impurities)	chemical products
4536	Bromoxynil	1689-84-5	Contains (regardless of intentional or impurities)	chemical products
4537	4-Pyridineboronic acid	1692-15-5	Intentional addition / 1%	chemical products
4538	Boronic acid, B-3-pyridinyl-	1692-25-7	Intentional addition / 1%	chemical products
4539	Triallyl borate	1693-71-6	Intentional addition / 1%	chemical products
4540	Benzenemethanaminium, N-[4-[4-(dimethylamino)phenyl][4-ethyl(3-sulphophenyl)methyl]amino]phenylmethylenyl]-2,5-cyclohexadien-1-ylidene]-N-ethyl-3-sulfo-, inner salt, sodium salt	1694-09-3	Contains (regardless of intentional or impurities)	chemical products
4541	1,3-Isobenzofuranone, 3a,4,7,7a-tetrahydro-5-methyl-, cis-	1694-82-2	Contains (regardless of intentional or impurities)	chemical products
4542	3(2H)-Pyridazinone, 5-amino-4-chloro-2-phenyl-	1698-60-8	Contains (regardless of intentional or impurities)	chemical products
4543	Thiocyanic acid, silver(1+) salt	1701-93-5	Intentional addition / 1,000ppm	chemical products
4544	m-Cyanobenzoyl chloride	1711-11-1	Intentional addition	chemical products
4545	Ethane, 1,1-dichloro-1-fluoro-	1717-00-6	Contains (regardless of intentional or impurities)	chemical products
4546	Acetonitrile [2-13C]	1722-09-4	Intentional addition / 1,000ppm	chemical products
4547	Boron, (N,N-diethylethanamine)trihydro-, (T-4)-	1722-26-5	Intentional addition / 1%	chemical products
4548	Aluminum, trihexadecyl-	1726-65-4	Intentional addition / 1,000ppm	chemical products
4549	Aluminum, tris(decyl)-	1726-66-5	Intentional addition / 1,000ppm	chemical products
4550	Borane, dibutylchloro-	1730-69-4	Intentional addition / 1%	chemical products
4551	2-Cyano-2-(phenylhydrazono)ethane thioamide	1733-04-6	Intentional addition	chemical products
4552	Allylpentafluorobenzene	1736-60-3	Intentional addition / 1,000ppm	chemical products
4553	.beta.-Dimethylaminopropionitrile	1738-25-6	Contains (regardless of intentional or impurities)	chemical products
4554	Acetonitrile, methoxy-	1738-36-9	Contains (regardless of intentional or impurities)	chemical products
4555	Borane, dichloropropyl-	1739-52-2	Intentional addition / 1%	chemical products
4556	Borane, dichloroethyl-	1739-53-3	Intentional addition / 1%	chemical products
4557	1,2,3,4-Tetrahydronaphthalen-1-amine hydrochloride	1743-01-7	Contains (regardless of intentional or impurities)	chemical products
4558	2,3,7,8-Tetrachlorodibenzop-p-dioxin	1746-01-6	Contains (regardless of intentional or impurities)	chemical products
4559	6-Methoxy-2-benzothiazolamine	1747-60-0	Contains (regardless of intentional or impurities)	chemical products
4560	(3a.alpha.,4.alpha.,7a.alpha.,7a.alpha.)-3a,4,7,7a-Tetrahydro-4,7-methano-1H-indene	1755-01-7	Intentional addition / 1%	chemical products
4561	o-Phenylenediarsonic acid	1758-48-1	Contains (regardless of intentional or impurities)	chemical products
4562	4-bromo-p-terphenyl	1762-84-1	Intentional addition / 100ppm	chemical products
4563	3-bromo-p-terphenyl	1762-87-4	Intentional addition / 100ppm	chemical products
4564	Boronic acid, B-(4-fluorophenyl)-	1765-93-1	Intentional addition / 1%	chemical products
4565	Pentachloroacetone	1768-31-6	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
4566	Sodium p-[4-[3-(2-arseno-4-nitrophenyl)triazen-1-yl]phenyl]azobenzenesulphonate	1772-02-7	Contains (regardless of intentional or impurities)	chemical products
4567	Borane, tris(1-methylethyl)-	1776-66-5	Intentional addition / 1,000ppm	chemical products
4568	2,4-dichlorobenzyl alcohol	1777-82-8	Intentional addition / 1,000ppm	chemical products
4569	Aluminum, chlorobis(2-methylpropyl)-	1779-25-5	Intentional addition / 1,000ppm	chemical products
4570	1,3-Dibromo-2-fluoropropane	1786-38-5	Intentional addition / 1,000ppm	chemical products
4571	Benzenesulfonic acid, 4-tetradecyl-, sodium salt	1797-33-7	Intentional addition / 1%	chemical products
4572	Ethane, 1-bromo-1,2-difluoro-	1800-81-3	Intentional addition / 1,000ppm	chemical products
4573	Tributoxyoxovanadium	1801-76-9	Intentional addition / 1%	chemical products
4574	Borane, chlorodimethyl-	1803-36-7	Intentional addition / 1%	chemical products
4575	Methanone, (2-chlorophenyl)(4-fluorophenyl)-	1806-23-1	Contains (regardless of intentional or impurities)	chemical products
4576	Phenol, 4-octyl-	1806-26-4	Intentional addition / 1%	chemical products
4577	Pentane, 3-bromo-	1809-10-5	Intentional addition / 1,000ppm	chemical products
4578	2-Pentene, 4-bromo-	1809-26-3	Intentional addition / 1,000ppm	chemical products
4579	Tetraethylphosphonium tetrafluoroborate	1813-60-1	Intentional addition / 1%	chemical products
4580	1,1,1,2,2-Pentafluoropropane	1814-88-6	Intentional addition / 1,000ppm	chemical products
4581	p-(1-Methylheptyl)phenol	1818-08-2	Intentional addition / 1%	chemical products
4582	Benzeneacetonitrile, alpha-methyl-	1823-91-2	Contains (regardless of intentional or impurities)	chemical products
4583	Ammine(trimethyl)boron	1830-95-1	Intentional addition / 1%	chemical products
4584	Iron(3+) acetate	1834-30-6	Intentional addition / 1%	chemical products
4585	Tetrafluorophthalonitrile	1835-49-0	Intentional addition	chemical products
4586	3,4,5,6-Tetrafluorobenzene-1,2-dicarbonitrile	1835-65-0	Intentional addition	chemical products
4587	Nitrofen	1836-75-5	Contains (regardless of intentional or impurities)	chemical products
4588	Benzoic acid, 2-hydroxy-5-sulfo-, beryllium salt (1:1)	1837-99-6	Contains (regardless of intentional or impurities)	chemical products
4589	(Dimethylamino)borane	1838-13-7	Intentional addition / 1%	chemical products
4590	Ethane, 1,1-dichloro-1,2-difluoro-	1842-05-3	Intentional addition / 1,000ppm	chemical products
4591	Phenol, 4,4',4''-(1-methyl-1-propanyl-3-ylidene)tris[2-(1,1-dimethylethyl)-5-methyl-	1843-03-4	Intentional addition / 1,000ppm	chemical products
4592	Ethanol, 2-(1,3,2-oxathiazibolan-2-ylthio)-	1843-42-1	Contains (regardless of intentional or impurities)	chemical products
4593	Cyclohexenecarbonitrile	1855-63-6	Contains (regardless of intentional or impurities)	chemical products
4594	Dimanganese(3+) trioxalate	1860-71-5	Intentional addition / 1%	chemical products
4595	Dibromofluoromethane	1868-53-7	Contains (regardless of intentional or impurities)	chemical products
4596	Propane, 1-bromo-2-fluoro-	1871-72-3	Contains (regardless of intentional or impurities)	chemical products
4597	Decanedinitrile	1871-96-1	Contains (regardless of intentional or impurities)	chemical products
4598	m-Cyanobenzoic acid	1877-72-1	Intentional addition	chemical products
4599	Phenyl chloroformate	1885-14-9	Contains (regardless of intentional or impurities)	chemical products
4600	Benzonitrile, 2-amino-	1885-29-6	Intentional addition	chemical products
4601	3,4,5-Trimethoxybenzonitrile	1885-35-4	Intentional addition	chemical products
4602	2-Propenenitrile, 3-phenyl-, (E)-	1885-38-7	Intentional addition	chemical products
4603	6-Nitro-2-toluenitrile	1885-76-3	Intentional addition	chemical products
4604	Aluminum, dichloro(2-methylpropyl)-	1888-87-5	Intentional addition / 1,000ppm	chemical products
4605	3,5-Dichloro-4-hydroxybenzonitrile	1891-95-8	Intentional addition	chemical products
4606	Tetrachloroterephthalonitrile	1897-41-2	Contains (regardless of intentional or impurities)	chemical products
4607	2,5-Dichlorobenzene-1,4-dicarbonitrile	1897-43-4	Intentional addition	chemical products
4608	Chlorothalonil	1897-45-6	Contains (regardless of intentional or impurities)	chemical products
4609	Benzonitrile, 2,6-difluoro-	1897-52-5	Intentional addition	chemical products
4610	Triethyltin acetate	1907-13-7	Contains (regardless of intentional or impurities)	chemical products
4611	Paraquat dichloride	1910-42-5	Contains (regardless of intentional or impurities)	chemical products
4612	2,4-Diphenyl-6-methylpyrylium tetrafluoroborate	1911-95-1	Intentional addition / 1%	chemical products
4613	Atrazine	1912-24-9	Contains (regardless of intentional or impurities)	chemical products
4614	Octanoic acid, tin(2+) salt	1912-83-0	Contains (regardless of intentional or impurities)	chemical products
4615	9-Octadecenoic acid (Z)-, tin(2+) salt	1912-84-1	Contains (regardless of intentional or impurities)	chemical products
4616	Picloram	1918-02-1	Contains (regardless of intentional or impurities)	chemical products
4617	1-Butanaminium, N,N,N-triethyl-, perchlorate	1923-70-2	Intentional addition / 1,000ppm	chemical products
4618	Methyl 2,4,5-trichlorophenoxyacetate	1928-37-6	Intentional addition / 1,000ppm	chemical products
4619	Ethyl 2,4,5-trichlorophenoxyacetate	1928-39-8	Intentional addition / 1,000ppm	chemical products
4620	Propyl 2,4,5-trichlorophenoxyacetate	1928-40-1	Intentional addition / 1,000ppm	chemical products
4621	Acetic acid, (2,4,5-trichlorophenoxy)-, 2-ethylhexyl ester	1928-47-8	Intentional addition / 1,000ppm	chemical products
4622	Nitrazym	1929-82-4	Contains (regardless of intentional or impurities)	chemical products
4623	4-Chloro-3,5-dinitrobenzonitrile	1930-72-9	Intentional addition	chemical products
4624	CI Direct Red 13	1937-35-5	Intentional addition / 100ppm	chemical products
4625	Triphenyltin phthalate	1954-36-5	Contains (regardless of intentional or impurities)	chemical products
4626	1,1'-Biphenyl, 3-cyclohexyl-	1973-15-5	Intentional addition / 1%	chemical products
4627	Heptane, 2-bromo-	1974-04-5	Intentional addition / 1,000ppm	chemical products
4628	Heptane, 3-bromo-	1974-05-6	Intentional addition / 1,000ppm	chemical products
4629	1-Hexene, 6-bromo-2-methyl-	1974-89-6	Intentional addition / 1,000ppm	chemical products
4630	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, iron(2+) salt (2:3)	1976-84-7	Intentional addition / 1%	chemical products
4631	Ammonium, (3-hydroxypropyl)trimethyl-, iodide, methylphosphonofluoridate	1978-17-2	Intentional addition / 1,000ppm	chemical products
4632	2,2'-(1,2-Dicarboxyethylene)bis(thio)bis[1,3,2-dithiastibolan-4,5-dicarboxylic] acid	1986-66-9	Contains (regardless of intentional or impurities)	chemical products
4633	2-Fluorophenylboronic acid	1993-03-9	Intentional addition / 1%	chemical products
4634	2-Propenoic acid, 2-methyl-, 3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10-heptadecafluorodecyl ester	1998-68-9	Contains (regardless of intentional or impurities)	chemical products
4635	2-Amino-2-chloro-5-nitrobenzophenone	2011-66-7	Contains (regardless of intentional or impurities)	chemical products
4636	Benzeneacetonitrile, 4-chloro-alpha-(1-methylethyl)-	2012-81-9	Contains (regardless of intentional or impurities)	chemical products
4637	Thiopyrylium, 4-(4-methoxyphenyl)-2,6-diphenyl-, tetrafluoroborate(1-)	2023-36-1	Intentional addition / 1%	chemical products
4638	Veratronitrile	2024-83-1	Intentional addition	chemical products
4639	[Oxalato(2-)-O,O']dioxouranium	2031-89-2	Contains (regardless of intentional or impurities)	chemical products
4640	3,3-Diethoxypropionitrile	2032-34-0	Intentional addition	chemical products
4641	Palladium cyanide (Pd(CN)2)	2035-66-7	Contains (regardless of intentional or impurities)	chemical products
4642	1H-Purine-6-carbonitrile	2036-13-7	Intentional addition	chemical products
4643	Dipropylaluminum hydride	2036-15-9	Intentional addition / 1,000ppm	chemical products
4644	o-Chlorostyrene	2039-87-4	Intentional addition / 1%	chemical products
4645	Thorium, bis(ethanedioate(2-)-O,O)-	2040-52-0	Intentional addition / 1,000ppm	chemical products
4646	Phenol, 2-chloro-6-fluoro-	2040-90-6	Contains (regardless of intentional or impurities)	chemical products
4647	2-Bromobenzonitrile	2042-37-7	Intentional addition	chemical products
4648	Decane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10-iodo-	2043-53-0	Contains (regardless of intentional or impurities)	chemical products
4649	Dodecane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10-heneicosafuoro-12-iodo-	2043-54-1	Contains (regardless of intentional or impurities)	chemical products
4650	Octane, 1,1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-8-iodo-	2043-57-4	Intentional addition / 1,000ppm	chemical products
4651	2-Aminophenylarsonic acid	2045-00-3	Contains (regardless of intentional or impurities)	chemical products
4652	Benzenebutanenitrile	2046-18-6	Contains (regardless of intentional or impurities)	chemical products
4653	Triphenylphosphine Borane	2049-55-0	Intentional addition / 1%	chemical products
4654	Benzene, 1,1'-oxybis(4-bromo-	2050-47-7	Intentional addition / 1,000ppm	chemical products
4655	Decan-4-ol	2051-31-2	Intentional addition / 1%	chemical products
4656	Propanoic acid, 2-bromo-2-methyl-	2052-01-9	Contains (regardless of intentional or impurities)	chemical products
4657	1,1'-Biphenyl, 2-bromo-	2052-07-5	Contains (regardless of intentional or impurities)	chemical products
4658	Paraquat bis(methyl sulfate)	2074-50-2	Contains (regardless of intentional or impurities)	chemical products
4659	Blasticidin S	2079-00-7	Contains (regardless of intentional or impurities)	chemical products
4660	Propanenitrile, 3-amino-, (E)-2-butenedioate (2:1)	2079-89-2	Intentional addition	chemical products
4661	2-Propanol, 2-methyl-, zirconium(4+) salt (4:1)	2081-12-1	Contains (regardless of intentional or impurities)	chemical products
4662	Barium di(tolueno-4-sulphonate)	2090-08-6	Contains (regardless of intentional or impurities)	chemical products
4663	Thiocyanic acid, barium salt	2092-17-3	Contains (regardless of intentional or impurities)	chemical products
4664	Tricyclo(3,3,1,1,3,7)decane-1-carbonyl chloride	2094-72-6	Contains (regardless of intentional or impurities)	chemical products
4665	Cyclohexanecarbonitrile, 1,1'-azobis-	2094-88-6	Contains (regardless of intentional or impurities)	chemical products
4666	1,3-Benzenediamine, 4,6-diethyl-2-methyl-	2095-01-4	Contains (regardless of intentional or impurities)	chemical products
4667	1,3-Benzenediamine, 2,4-diethyl-6-methyl-	2095-02-5	Contains (regardless of intentional or impurities)	chemical products
4668	N-Isopropyl-2-methylamine	2100-43-8	Intentional addition	chemical products
4669	O-Ethyl O-(4-nitrophenyl) phenylphosphonothioate	2104-64-5	Contains (regardless of intentional or impurities)	chemical products
4670	1-Chloro-2-fluoro-3-nitrobenzene	2106-49-2	Contains (regardless of intentional or impurities)	chemical products
4671	1,1'-Biphenyl, 3-bromo-	2113-57-7	Contains (regardless of intentional or impurities)	chemical products
4672	4-Aminobiphenyl hydrochloride	2113-61-3	Contains (regardless of intentional or impurities)	chemical products
4673	(2-Bromopropyl)benzene	2114-39-8	Intentional addition / 1,000ppm	chemical products
4674	Benzylmercuric chloride	2117-39-7	Contains (regardless of intentional or impurities)	chemical products
4675	Ethynylenebis(trimethylstannane)	2117-50-2	Contains (regardless of intentional or impurities)	chemical products
4676	Boric acid, B.B-bis(2,3,4,5,6-pentafluorophenyl)-	2118-02-7	Intentional addition / 1%	chemical products
4677	2-(Tetradecyloxy)ethanol	2136-70-1	Intentional addition / 1%	chemical products
4678	Iron acetate	2140-52-5	Intentional addition / 1%	chemical products
4679	Propanenitrile, 3-ethoxy-	2141-62-0	Intentional addition	chemical products
4680	2-Propenoic acid, 2-methyl-, 3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12-heneicosafuorodecyl ester	2144-54-9	Contains (regardless of intentional or impurities)	chemical products
4681	Benzenediazonium, 4-sulfo-, tetrafluoroborate(1-)	2145-24-6	Intentional addition / 1%	chemical products
4682	2,7-Naphthalenedisulfonic acid, 3,3'-[[3,3'-dimethyl[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[4,5-dihydroxy-, tetrasodium salt	2150-54-1	Intentional addition / 100ppm	chemical products
4683	3-Cyano-propyl	2154-70-3	Intentional addition	chemical products
4684	1-Butylstibine	2155-73-9	Contains (regardless of intentional or impurities)	chemical products
4685	1-Butanol, antimony(3+) salt	2155-74-0	Contains (regardless of intentional or impurities)	chemical products
4686	Acetic acid, 2,2,2'-[stibylidynetris(thio)]tris-, tris(6-methylheptyl)ester	2155-75-1	Contains (regardless of intentional or impurities)	chemical products
4687	Hexanoic acid, 2-ethyl-, antimony(3+) salt	2155-81-9	Contains (regardless of intentional or impurities)	chemical products
4688	4-Vinylphenylboronic acid	2156-04-9	Intentional addition / 1%	chemical products
4689	4-(Azidosulfonyl)acetanilide	2158-14-7	Intentional addition / 1%	chemical products
4690	Hexane, 1,2-dichloro-	2162-92-7	Intentional addition / 1,000ppm	chemical products
4691	Octane, 1,8-dichloro-	2162-99-4	Intentional addition / 1,000ppm	chemical products
4692	1,6-Dichlorohexane	2163-00-0	Intentional addition / 1,000ppm	chemical products
4693	3-Amino-4-hydroxyphenylarsonic acid	2163-77-1	Contains (regardless of intentional or impurities)	chemical products
4694	Sodium methylarsenate	2163-80-6	Contains (regardless of intentional or impurities)	chemical products
4695	Endothal-potassium	2164-07-0	Intentional addition / 1.5%	chemical products
4696	Fluometuron	2164-17-2	Intentional addition / 1,000ppm	chemical products
4697	Borate(1-), tetramethyl-, lithium	2169-38-2	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
4698	trans- $\alpha$ -Cyanocinnamate	2169-69-9	Intentional addition	chemical products
4699	Octabromodibenzo-p-dioxin	2170-45-8	Intentional addition / 100ppm	chemical products
4700	Zirconium(4+) propan-2-olate	2171-98-4	Contains (regardless of intentional or impurities)	chemical products
4701	Hafnium isopropoxide	2171-99-5	Intentional addition / 1%	chemical products
4702	Hafnium(IV) tert-butoxide	2172-02-3	Intentional addition / 1%	chemical products
4703	Yttrium(III) isopropoxide	2172-12-5	Intentional addition / 1,000ppm	chemical products
4704	3,3,3-Tris(4-chlorophenyl)propanenitrile	2172-51-2	Intentional addition	chemical products
4705	Tetrapropyltin	2176-98-9	Contains (regardless of intentional or impurities)	chemical products
4706	Palladium(2+) tetrafluoroborate-acetonitrile (1:2:4)	2179-13-7	Intentional addition	chemical products
4707	Allyl propyl disulfide	2179-59-1	Contains (regardless of intentional or impurities)	chemical products
4708	Phenylselenocyanate	2179-79-5	Contains (regardless of intentional or impurities)	chemical products
4709	tetbutyltin cyanide	2179-92-2	Contains (regardless of intentional or impurities)	chemical products
4710	Bis(tetrahydroxy)dimethylstannane	2179-99-9	Contains (regardless of intentional or impurities)	chemical products
4711	Aluminum, tris(4-methylphenyl)-	2180-65-6	Intentional addition / 1,000ppm	chemical products
4712	2-(4-Chlorophenyl)propionitrile	2184-88-5	Contains (regardless of intentional or impurities)	chemical products
4713	Stibonium, tetramethyl-, iodide	2185-78-6	Contains (regardless of intentional or impurities)	chemical products
4714	[(p-Tolyloxy)methyl]oxirane	2188-24-5	Contains (regardless of intentional or impurities)	chemical products
4715	Octanoic acid, cadmium salt (2:1)	2191-10-8	Contains (regardless of intentional or impurities)	chemical products
4716	Propane, 2-bromo-1,3-difluoro-	2195-05-3	Intentional addition / 1,000ppm	chemical products
4717	Nonane, 5-bromo-	2198-44-9	Intentional addition / 1,000ppm	chemical products
4718	o-Dichloro(2H)benzene	2199-69-1	Intentional addition / 1%	chemical products
4719	Barium pentadecanoate	2202-23-5	Intentional addition / 1,000ppm	chemical products
4720	[2H3]Acetonitrile	2206-26-0	Contains (regardless of intentional or impurities)	chemical products
4721	[(p-Isopropylphenoxy)methyl]oxirane	2210-72-2	Contains (regardless of intentional or impurities)	chemical products
4722	[(o-Methoxyphenoxy)methyl]oxirane	2210-74-4	Contains (regardless of intentional or impurities)	chemical products
4723	Oxirane, [(2-methylphenoxy)methyl]-	2210-79-9	Contains (regardless of intentional or impurities)	chemical products
4724	2-Butene, 2-chloro-, (E)-	2211-68-9	Intentional addition / 1,000ppm	chemical products
4725	2-Butene, 2-chloro-, (Z)-	2211-69-0	Intentional addition / 1,000ppm	chemical products
4726	Benzenesulfonic acid, 4-dodecyl-, sodium salt	2211-98-5	Intentional addition / 1%	chemical products
4727	Molinate	2212-67-1	Contains (regardless of intentional or impurities)	chemical products
4728	Heptane, 2,4-dimethyl-	2213-23-2	Contains (regardless of intentional or impurities)	chemical products
4729	Bis(diphenylarsenic) oxide	2215-16-9	Contains (regardless of intentional or impurities)	chemical products
4730	Heptane, 2,5-dimethyl-	2216-30-0	Contains (regardless of intentional or impurities)	chemical products
4731	Heptane, 4-ethyl-	2216-32-2	Intentional addition / 1,000ppm	chemical products
4732	3-Methylcyclohexane	2216-33-3	Intentional addition / 1,000ppm	chemical products
4733	4-Methylcyclohexane	2216-34-4	Intentional addition / 1,000ppm	chemical products
4734	2-Bromononane	2216-35-5	Intentional addition / 1,000ppm	chemical products
4735	Cyclohexanecarboxylic acid, copper(2+) salt	2218-80-6	Intentional addition / 1,000ppm	chemical products
4736	Cadmium stearate	2223-93-0	Contains (regardless of intentional or impurities)	chemical products
4737	Octadecanoic acid, nickel(2+) salt	2223-95-2	Contains (regardless of intentional or impurities)	chemical products
4738	Oxirane, 2,2'-[1,2-ethanediylbis(oxy)methylene]bis-	2224-15-9	Contains (regardless of intentional or impurities)	chemical products
4739	Dimethylbis(myristoyloxy)stannane	2232-69-1	Contains (regardless of intentional or impurities)	chemical products
4740	1-Propene, 3,3,3-trichloro-	2233-00-3	Intentional addition / 1,000ppm	chemical products
4741	Zirconium tetra(2-ethylhexanoate)	2233-42-3	Contains (regardless of intentional or impurities)	chemical products
4742	Ethanone, 1-(2,4-dichlorophenyl)-	2234-16-4	Contains (regardless of intentional or impurities)	chemical products
4743	Norbornane-2-carbonitrile	2234-26-6	Intentional addition	chemical products
4744	3-Aminobenzonitrile	2237-30-1	Contains (regardless of intentional or impurities)	chemical products
4745	Diglycidyl ether	2238-07-5	Contains (regardless of intentional or impurities)	chemical products
4746	Nonanenitrile	2243-27-8	Contains (regardless of intentional or impurities)	chemical products
4747	Undecanenitrile	2244-07-7	Contains (regardless of intentional or impurities)	chemical products
4748	Benzenediazonium, 4-(4-morpholinyl)-, tetrafluoroborate(1-)	2248-34-2	Contains (regardless of intentional or impurities)	chemical products
4749	Propane, 1-bromo-1,1,2,3,3,3-hexafluoro-	2252-78-0	Contains (regardless of intentional or impurities)	chemical products
4750	Propane, 2-bromo-1,1,1,3,3,3-hexafluoro-	2252-79-1	Intentional addition / 1,000ppm	chemical products
4751	Propane, 2-bromo-1,1,1,2,3,3-hexafluoro-	2252-80-4	Intentional addition / 1,000ppm	chemical products
4752	1,1,1,2,2,3,3-Heptafluoropropane	2252-84-8	Contains (regardless of intentional or impurities)	chemical products
4753	Propane, 1,1,1,3-tetrachloro-2,2,3,3-tetrafluoro-	2262-46-4	Intentional addition / 1,000ppm	chemical products
4754	2-Pentene, 5-bromo-2-methyl-	2270-59-9	Intentional addition / 1,000ppm	chemical products
4755	Stannane, butylhydroxyoxo-	2273-43-0	Intentional addition / 1,000ppm	chemical products
4756	Stannane, dimethyloxo-	2273-45-2	Intentional addition / 1,000ppm	chemical products
4757	Didodecylstannane	2273-48-5	Contains (regardless of intentional or impurities)	chemical products
4758	Oxidophenylstannane	2273-51-0	Contains (regardless of intentional or impurities)	chemical products
4759	Methylacetonitrile	2274-42-2	Intentional addition	chemical products
4760	2-Chloro-1-(2,4-dichlorophenyl)vinyl dimethyl phosphate	2274-67-1	Intentional addition / 1%	chemical products
4761	Phenkapton	2275-14-1	Contains (regardless of intentional or impurities)	chemical products
4762	Vamidithion	2275-23-2	Contains (regardless of intentional or impurities)	chemical products
4763	(phenylmercurio)urea	2279-64-3	Contains (regardless of intentional or impurities)	chemical products
4764	Tripropyltin chloride	2279-76-7	Contains (regardless of intentional or impurities)	chemical products
4765	4-Bromo-1-naphthylamine	2298-07-9	Contains (regardless of intentional or impurities)	chemical products
4766	1-Naphthalenesulfonic acid, 8,8'-[[1,1'-biphenyl]-4,4'-diylbis(azo)]bis[4-hydroxy-, disodium salt	2302-97-8	Contains (regardless of intentional or impurities)	chemical products
4767	Phosalone	2310-17-0	Contains (regardless of intentional or impurities)	chemical products
4768	2-Bromo-2-chloropropane	2310-98-7	Intentional addition / 1,000ppm	chemical products
4769	Propane, 2-bromo-2-fluoro-	2311-00-4	Intentional addition / 1,000ppm	chemical products
4770	Propargite	2312-35-8	Contains (regardless of intentional or impurities)	chemical products
4771	Sodium dinitro-ortho-cresolate	2312-76-7	Contains (regardless of intentional or impurities)	chemical products
4772	Methane, trifluoroiodo-	2314-97-8	Contains (regardless of intentional or impurities)	chemical products
4773	2-Methyl-1,3-benzene dicarbonitrile	2317-22-8	Intentional addition	chemical products
4774	1-Chloro-1-fluoroethylene	2317-91-1	Intentional addition / 1,000ppm	chemical products
4775	Ammonium methylarsenate	2321-53-1	Intentional addition / 100ppm	chemical products
4776	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, iron salt	2338-05-8	Intentional addition / 1%	chemical products
4777	4-(Trifluoromethyl)phenylacetone	2338-75-2	Contains (regardless of intentional or impurities)	chemical products
4778	Benzenecarbonitrile, 3-(trifluoromethyl)-	2338-76-3	Contains (regardless of intentional or impurities)	chemical products
4779	2,6-Diphenyl-4-methylpyrylium tetrafluoroborate	2340-23-0	Intentional addition / 1%	chemical products
4780	Hexane, 3-chloro-	2346-81-8	Intentional addition / 1,000ppm	chemical products
4781	Cerezin	2346-99-8	Intentional addition / 1%	chemical products
4782	Heptane, 2-chloro-6-methyl-	2350-19-8	Intentional addition / 1,000ppm	chemical products
4783	1,1,1,2,3-Pentachloro-2,3,3-trifluoropropane	2354-05-4	Intentional addition	chemical products
4784	1,2,2-Trifluoropentachloropropane	2354-06-5	Contains (regardless of intentional or impurities)	chemical products
4785	1-Methyl-2,4,6-triphenylpyridinium tetrafluoroborate	2355-56-8	Intentional addition / 1%	chemical products
4786	Fast Red B, tetrafluoroborate salt	2357-51-9	Intentional addition / 1%	chemical products
4787	2-Ethoxy-N,N,4-diethyl-p-phenylenediamine	2359-46-8	Intentional addition / 1,000ppm	chemical products
4788	2,4-Dinitro-1-(4-nitrophenoxy)benzene	2363-36-2	Intentional addition / 1%	chemical products
4789	Ethane, 1,1,1-trichloro-2-fluoro-	2366-36-1	Intentional addition / 1,000ppm	chemical products
4790	Butane, 1-fluoro-	2366-52-1	Contains (regardless of intentional or impurities)	chemical products
4791	Benzenediazonium, 4-(phenylamino)-, tetrafluoroborate(1-)	2367-19-3	Intentional addition / 1%	chemical products
4792	1-Bromo-2,4,6-trifluorobenzene	2367-76-2	Intentional addition / 1,000ppm	chemical products
4793	1,2,3,5-Tetrafluorobenzene	2367-82-0	Intentional addition / 1,000ppm	chemical products
4794	1,2-Dibromo-4-fluorobenzene	2369-37-1	Intentional addition / 1,000ppm	chemical products
4795	Isopropyl OO-tert-pentyl monoperoxydicarbonate	2372-22-7	Contains (regardless of intentional or impurities)	chemical products
4796	1,3-Propanediamine, N-(3-aminopropyl)-N-dodecyl-	2372-82-9	Intentional addition / 1,000ppm	chemical products
4797	2,6,6-Tetrafluorophthalonitrile	2372-81-3	Intentional addition	chemical products
4798	1-Butanesulfonyl chloride	2386-60-9	Contains (regardless of intentional or impurities)	chemical products
4799	Dipumbane, hexasthyl-	2388-00-3	Contains (regardless of intentional or impurities)	chemical products
4800	Ethanediamine, N-[4'-[4-(diethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene-N-ethyl-, chloride	2390-60-5	Intentional addition / 1,000ppm	chemical products
4801	Didodecylmethylammonium bromide	2390-68-3	Intentional addition / 1,000ppm	chemical products
4802	Carbamothioic acid, methyl(3-methylphenyl)-, O-2-naphthalenyl ester	2398-96-1	Intentional addition / 1,000ppm	chemical products
4803	Acetic acid, nitrotri-, beryllium salt (1:1)	2399-81-7	Contains (regardless of intentional or impurities)	chemical products
4804	Butyltin	2408-65-7	Contains (regardless of intentional or impurities)	chemical products
4805	3-(Dimethylamino)acrylonitrile	2407-68-3	Intentional addition	chemical products
4806	Lithium cyanide	2408-36-8	Contains (regardless of intentional or impurities)	chemical products
4807	Propanenitrile, 3-bromo-	2417-90-5	Contains (regardless of intentional or impurities)	chemical products
4808	Benzoic acid, 4-methyl-, cadmium salt	2420-97-5	Contains (regardless of intentional or impurities)	chemical products
4809	Hexanoic acid, 2-ethyl-, cadmium salt (2:1)	2420-98-6	Contains (regardless of intentional or impurities)	chemical products
4810	Aniline sulphate (1:1)	2424-53-5	Contains (regardless of intentional or impurities)	chemical products
4811	Captafol	2425-06-1	Contains (regardless of intentional or impurities)	chemical products
4812	Phenol, 3,4-dimethyl-, methylcarbamate	2425-10-7	Contains (regardless of intentional or impurities)	chemical products
4813	1-Decanol, 2-hexyl-	2425-77-6	Intentional addition / 1,000ppm	chemical products
4814	Oxirane, 2,2'-[1,4-butanediylbis(oxy)methylene]bis-	2425-79-8	Contains (regardless of intentional or impurities)	chemical products
4815	n-Butyl glycidyl ether	2426-08-6	Contains (regardless of intentional or impurities)	chemical products
4816	1H-Indole-3-ethanamine, 5-methoxy-N,N-dimethyl-, hydrochloride (1:1)	2427-79-4	Intentional addition	chemical products
4817	C.I. Direct Red 10, disodium salt	2429-70-1	Intentional addition / 100ppm	chemical products
4818	1-Naphthalenesulfonic acid, 3,3'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[4-hydroxy-, disodium salt	2429-71-2	Intentional addition / 100ppm	chemical products
4819	Disodium 3-[[4'-[(6-amino-1-hydroxy-3-sulphonato-2-naphthyl)azo]-3,3'-dimethyl[1,1'-biphenyl]-4-yl]azo]-4-hydroxynaphthalene-1-sulphonate	2429-72-3	Intentional addition / 100ppm	chemical products
4820	C.I. Direct Blue 2	2429-73-4	Contains (regardless of intentional or impurities)	chemical products
4821	C.I. Direct Blue 15	2429-74-5	Contains (regardless of intentional or impurities)	chemical products
4822	C.I. Direct Violet 12	2429-75-6	Intentional addition / 100ppm	chemical products
4823	Benzoic acid, 5-[[4'-[(1-amino-4-sulfo-2-naphthalenyl)azo][1,1'-biphenyl]-4-yl]azo]-2-hydroxy-, disodium salt	2429-79-0	Contains (regardless of intentional or impurities)	chemical products
4824	C.I. Acid Orange 45	2429-80-3	Contains (regardless of intentional or impurities)	chemical products
4825	C.I. Direct brown 31, tetrasodium salt	2429-81-4	Contains (regardless of intentional or impurities)	chemical products
4826	C.I. Direct brown 2, disodium salt	2429-82-5	Contains (regardless of intentional or impurities)	chemical products
4827	C.I. Direct Black 4	2429-83-6	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
4828	C.I Direct red 1, disodium salt	2429-84-7	Contains (regardless of intentional or impurities)	chemical products
4829	Tolboxane	2430-46-8	Intentional addition / 1%	chemical products
4830	Hexanenitrile, 6-amino-	2432-74-8	Intentional addition	chemical products
4831	Methanaminium, N-[4-[[4-(dimethylamino)phenyl]phenylmethylene]-2,5-cyclohexadien-1-ylidene]-N-methyl-, ethanedioate, ethanedioate (2:2:1)	2437-29-8	Contains (regardless of intentional or impurities)	chemical products
4832	Dodecylguanidine monoacetate	2439-10-3	Contains (regardless of intentional or impurities)	chemical products
4833	2-Propenoic acid, 2-(dimethylamino)ethyl ester	2439-35-2	Intentional addition / 1%	chemical products
4834	2-Benzotriazolyl-4-methylphenol	2440-22-4	Intentional addition / 100ppm	chemical products
4835	Uracil	2445-07-0	Contains (regardless of intentional or impurities)	chemical products
4836	3-Methyl-N,N-trisopentylbutan-1-aminium salt with 2,4,6-trinitrophenol (1:1)	2450-57-9	Contains (regardless of intentional or impurities)	chemical products
4837	Hexanoic acid, 2-ethyl-, barium salt (2:1)	2457-01-4	Intentional addition / 1,000ppm	chemical products
4838	[Naphthylsilyl]methylloxirane	2461-42-9	Intentional addition / 1%	chemical products
4839	4,4'-Bis[2-(3-oxopropoxy)phenyl]biphenyl	2461-46-3	Contains (regardless of intentional or impurities)	chemical products
4840	N,N-Dimethyltridecylammonium (2,4,5-trichlorophenoxy)acetate	2464-48-4	Intentional addition / 1,000ppm	chemical products
4841	Auramine	2465-27-2	Contains (regardless of intentional or impurities)	chemical products
4842	1,2,3,4,5,6-Hexakis-O-(2-cyanoethyl)hexitol	2465-92-1	Intentional addition	chemical products
4843	Propanenitrile, 3,3',3'-[1,2,3-propanetriyltris(oxy)]tris-	2465-93-2	Intentional addition	chemical products
4844	1,1,1,5-Tetrachloropentane	2467-10-9	Intentional addition / 1,000ppm	chemical products
4845	Boric acid (H3BO3), triethyl ester	2467-12-1	Intentional addition / 1%	chemical products
4846	Tris(2-ethylhexyl) orthoborate	2467-13-2	Intentional addition / 1%	chemical products
4847	Tridodecyl borate	2467-15-4	Intentional addition / 1%	chemical products
4848	Boric acid (H3BO3), tricyclohexyl ester	2467-16-5	Intentional addition / 1%	chemical products
4849	Tribenzyl borate	2467-18-7	Intentional addition / 1%	chemical products
4850	9,10-Anthracenedione, 1,4-bis(methylamino)-	2475-44-7	Contains (regardless of intentional or impurities)	chemical products
4851	C.I Disperse Blue 1	2475-45-8	Contains (regardless of intentional or impurities)	chemical products
4852	2-Phenyl-1,3,2-benzodiazaborole	2479-64-3	Intentional addition / 1%	chemical products
4853	Trimethylthiourea	2489-77-2	Contains (regardless of intentional or impurities)	chemical products
4854	2-bromo-1-(4-hydroxyphenyl)ethan-1-one	2491-38-5	Intentional addition / 1,000ppm	chemical products
4855	Sodium mercaptobenzothiazole	2492-26-4	Intentional addition / 1,000ppm	chemical products
4856	1-(Carbazol-9-yl)-3-chloropropan-1-one	2499-66-3	Contains (regardless of intentional or impurities)	chemical products
4857	Phenanthrene-9-carbonitrile	2510-55-6	Intentional addition	chemical products
4858	Benzeneacetone, alpha-(phenylmethylene)-	2510-95-4	Intentional addition	chemical products
4859	O,O-Dimethyl phosphorochlorodithioate	2524-03-0	Contains (regardless of intentional or impurities)	chemical products
4860	Propanenitrile, 3-(trimethoxysilyl)-	2526-62-7	Intentional addition	chemical products
4861	Benzamide, 2,2'-dithiobis[N-methyl]-	2527-58-4	Intentional addition / 1,000ppm	chemical products
4862	Dibutyl phenyl phosphate	2528-36-1	Intentional addition / 1%	chemical products
4863	Methyl arsenic sulfide	2533-82-6	Contains (regardless of intentional or impurities)	chemical products
4864	Benzene, 1,1'-methylenebis[2-isocyanato-	2536-05-2	Contains (regardless of intentional or impurities)	chemical products
4865	Methanaminium, N,N,N-trimethyl-, perchlorate	2537-36-2	Intentional addition / 1,000ppm	chemical products
4866	Diethyl (cyanomethyl)phosphonate	2537-48-6	Intentional addition	chemical products
4867	2,6-dimethylphenylhydrazine chloride	2538-61-6	Contains (regardless of intentional or impurities)	chemical products
4868	Acetic acid, (2,4,5-trichlorophenoxy)-, 2-butoxyethyl ester	2545-59-7	Intentional addition / 1,000ppm	chemical products
4869	Sulfur hexafluoride	2551-62-4	Contains (regardless of intentional or impurities)	chemical products
4870	2,6-Diphenyl-4-(p-tolyl)pyrylium tetrafluoroborate	2559-35-5	Intentional addition / 1%	chemical products
4871	1,1,3-Trichloropropene	2567-14-8	Intentional addition / 1,000ppm	chemical products
4872	Tetraethylammonium perchlorate	2567-83-1	Intentional addition / 1,000ppm	chemical products
4873	3-(2-Oxocyclohexyl)propanal	2568-20-9	Intentional addition / 1%	chemical products
4874	Acetic acid, thallium(3+) salt	2570-63-0	Contains (regardless of intentional or impurities)	chemical products
4875	2,4,6-Trimethoxybenzonitrile	2571-94-2	Intentional addition	chemical products
4876	Methylselenocysteine	2574-71-2	Contains (regardless of intentional or impurities)	chemical products
4877	Butanoic acid, 2-amino-4-(ethylseleno)-	2578-27-0	Intentional addition / 1,000ppm	chemical products
4878	DL-Selenomethionine	2578-28-1	Contains (regardless of intentional or impurities)	chemical products
4879	2-Anthracenesulfonic acid, 1-amino-9,10-dihydro-9,10-dioxo-4-[[3-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-, disodium salt	2580-78-1	Contains (regardless of intentional or impurities)	chemical products
4880	C.I Direct Blue 22, disodium salt	2586-57-4	Intentional addition / 100ppm	chemical products
4881	Benzoic acid, 5-[4'-[[2,6-diamino-3-methyl-5(sulfophenyl) azo]phenyl]azo][1,1'-biphenyl]-4-yl]azo]-2-hydroxy-, disodium salt	2586-58-5	Contains (regardless of intentional or impurities)	chemical products
4882	C.I Direct Violet 1	2586-60-9	Contains (regardless of intentional or impurities)	chemical products
4883	Stannane, chlorotriethyl-	2587-76-0	Contains (regardless of intentional or impurities)	chemical products
4884	Plumbane, acetoxytriethyl-	2587-81-7	Contains (regardless of intentional or impurities)	chemical products
4885	Acetoxytributylplumbane	2587-82-8	Contains (regardless of intentional or impurities)	chemical products
4886	Bis(triphenyltin) dodecylsuccinate	2591-32-4	Intentional addition / 1,000ppm	chemical products
4887	Mecarbam	2595-54-2	Contains (regardless of intentional or impurities)	chemical products
4888	Phenothate	2597-03-7	Contains (regardless of intentional or impurities)	chemical products
4889	5-Norbornene-2,3-dicarboximide, 1,4,5,6,7,7-hexachloro-N-(ethylmercuri)-	2597-93-5	Contains (regardless of intentional or impurities)	chemical products
4890	C.I Direct blue 6	2602-46-2	Contains (regardless of intentional or impurities)	chemical products
4891	Dodecanoic acid, cadmium salt	2605-44-9	Contains (regardless of intentional or impurities)	chemical products
4892	Benzenesulfonic acid, 4-decyl-, sodium salt	2627-06-7	Intentional addition / 1%	chemical products
4893	Chlorodiphenylantimony	2629-47-2	Contains (regardless of intentional or impurities)	chemical products
4894	Hexyl (2,4,5-trichlorophenoxy)acetate	2630-13-9	Intentional addition / 1,000ppm	chemical products
4895	Octyl (2,4,5-trichlorophenoxy)acetate	2630-15-1	Intentional addition / 1,000ppm	chemical products
4896	Nonyl (2,4,5-trichlorophenoxy)acetate	2630-16-2	Intentional addition / 1,000ppm	chemical products
4897	Promecarb	2631-37-0	Contains (regardless of intentional or impurities)	chemical products
4898	Isoprocab	2631-40-5	Contains (regardless of intentional or impurities)	chemical products
4899	1,2-Benzisothiazol-3(2H)-one	2634-33-5	Contains (regardless of intentional or impurities)	chemical products
4900	Barium diicosanoate	2636-14-8	Intentional addition / 1,000ppm	chemical products
4901	Docosanoic acid, barium salt	2636-16-0	Intentional addition / 1,000ppm	chemical products
4902	Barium tetracosanoate	2636-17-1	Intentional addition / 1,000ppm	chemical products
4903	Barium heptadecanoate	2636-18-2	Intentional addition / 1,000ppm	chemical products
4904	Pentanoic acid, 4,4'-azobis[4-cyano-	2638-94-0	Intentional addition	chemical products
4905	Boron, (2,4-dimethylbenzenamine)trifluoro-	2641-68-1	Intentional addition / 1%	chemical products
4906	Hydrazine, monohydrochloride	2644-70-4	Contains (regardless of intentional or impurities)	chemical products
4907	C.I Solvent Orange 2	2646-17-5	Contains (regardless of intentional or impurities)	chemical products
4908	3,5-Xylyl methylcarbamate	2655-14-3	Contains (regardless of intentional or impurities)	chemical products
4909	Benzenamine, N-pentyl-	2655-27-8	Intentional addition	chemical products
4910	Trihexadecyl borate	2665-11-4	Intentional addition / 1%	chemical products
4911	Tri-o-tolyl borate	2665-12-5	Intentional addition / 1%	chemical products
4912	1,3,2-Dioxaborinane, 2,2'-((1-methyl-1,3-propanediyl(bis(oxy))bis[4-methyl-	2665-13-6	Intentional addition / 1%	chemical products
4913	[1,1'-Biphenyl]-4-ol, 3,5-bis(1,1-dimethylethyl)-	2668-47-5	Intentional addition / 1%	chemical products
4914	Stannane, ((cyclohexylcarbonyl)oxy)tributyl-	2669-35-4	Contains (regardless of intentional or impurities)	chemical products
4915	S-(2-Ethylsulphonyl-1-methylthio)-O-dimethyl phosphorothioate	2674-91-1	Intentional addition / 1%	chemical products
4916	Benzene, 1,4-dichloro-2,5-dimethoxy-	2675-77-6	Contains (regardless of intentional or impurities)	chemical products
4917	Phenol, barium salt	2678-41-3	Contains (regardless of intentional or impurities)	chemical products
4918	3(2H)-Isothiazolone, 2-methyl-	2682-20-4	Intentional addition / 10ppm	chemical products
4919	1,2-Benzenediamine, 3-methyl-	2687-25-4	Contains (regardless of intentional or impurities)	chemical products
4920	2-Pyrrolidinone, 1-ethyl-	2687-91-4	Contains (regardless of intentional or impurities)	chemical products
4921	1-Hexene, 6-bromo-	2695-47-8	Intentional addition / 1,000ppm	chemical products
4922	8-Bromooct-1-ene	2695-48-9	Intentional addition / 1,000ppm	chemical products
4923	Selenocystamine	2697-61-2	Contains (regardless of intentional or impurities)	chemical products
4924	o-Chlorobenzylidene malonitrile	2698-41-1	Contains (regardless of intentional or impurities)	chemical products
4925	Sulfuryl fluoride	2699-79-8	Contains (regardless of intentional or impurities)	chemical products
4926	beta, beta-Styrenedicarbonitrile	2700-22-3	Intentional addition	chemical products
4927	Butanamide, 2,2,3,3,4,4,4-heptafluoro-N-(2-hydroxy-4-nitrophenyl)-	2712-53-6	Intentional addition / 1%	chemical products
4928	1,1-Dichloro-1,2,2,3,3,3-hexafluoropropane	2729-28-4	Intentional addition	chemical products
4929	Pyridine-2-acetonitrile	2739-97-1	Intentional addition	chemical products
4930	Thallose malonate	2757-18-8	Contains (regardless of intentional or impurities)	chemical products
4931	trans,cis,cis-Cyclododeca-1,5,9-triene	2765-29-9	Intentional addition / 1%	chemical products
4932	Stannane, bromotriethyl-	2767-54-6	Contains (regardless of intentional or impurities)	chemical products
4933	Diethyltin diiodide	2767-55-7	Contains (regardless of intentional or impurities)	chemical products
4934	Tripropyltin bromide	2767-61-5	Contains (regardless of intentional or impurities)	chemical products
4935	C.I Direct Red 17	2769-07-5	Intentional addition / 100ppm	chemical products
4936	Methyl (2)-octadec-6-enoate	2777-58-4	Contains (regardless of intentional or impurities)	chemical products
4937	Octyl 4,4-dibutyl-7-oxo-8-oxa-3,5-dithia-4-stannahexadecanoate	2781-09-1	Contains (regardless of intentional or impurities)	chemical products
4938	Di-n-butyltin di-2-ethylhexanoate	2781-10-4	Contains (regardless of intentional or impurities)	chemical products
4939	Ethanol, 2,2'-[[4-(methylamino)-3-nitrophenyl]imino]bis-	2784-94-3	Contains (regardless of intentional or impurities)	chemical products
4940	3-Methylbenzothiazole-2(3H)-selenone	2786-43-8	Contains (regardless of intentional or impurities)	chemical products
4941	Trihexyltin chloride	2791-60-8	Contains (regardless of intentional or impurities)	chemical products
4942	Methanesulfonic acid, trifluoro-, barium salt	2794-60-7	Contains (regardless of intentional or impurities)	chemical products
4943	Ethanaminium, 2-[(fluoromethyl)phosphinyloxy]-N,N,N-trimethyl-, iodide	2797-10-6	Intentional addition / 1,000ppm	chemical products
4944	Lithium tetrakis(pentafluorophenyl)borate-diethyl ether complex (1:2)	2797-28-6	Intentional addition / 1%	chemical products
4945	Tin(IV) acetate	2800-96-6	Intentional addition / 1,000ppm	chemical products
4946	Borate(1-), trifluoromethoxy-, (T-4)-, hydrogen compound with methanol (1:1)	2802-68-8	Intentional addition / 1%	chemical products
4947	Propane, 3-bromo-1,1,1,2,2,3-hexafluoro-	2805-10-9	Intentional addition / 1,000ppm	chemical products
4948	Dinoseb acetate	2813-95-8	Contains (regardless of intentional or impurities)	chemical products
4949	Benzoselenazole, 2-methyl-	2818-88-4	Contains (regardless of intentional or impurities)	chemical products
4950	2,5-dimethylbenzoselenazole	2818-89-5	Contains (regardless of intentional or impurities)	chemical products
4951	Nicotinic hydrochloride	2820-51-1	Contains (regardless of intentional or impurities)	chemical products
4952	[(4-Methoxyphenyl)methylene]propanedinitrile	2826-26-8	Intentional addition	chemical products
4953	C.I Disperse Yellow 3	2832-40-8	Contains (regardless of intentional or impurities)	chemical products
4954	Phenol, 4-amino-3-methyl-	2835-99-6	Contains (regardless of intentional or impurities)	chemical products
4955	Ethane, 2-chloro-1,1,1,2-tetrafluoro-	2837-89-0	Intentional addition / 1,000ppm	chemical products
4956	Decanoic acid, cadmium salt	2847-16-7	Contains (regardless of intentional or impurities)	chemical products
4957	Stannane, ((p-acetamidobenzoyloxy)triphenyl-	2847-65-6	Contains (regardless of intentional or impurities)	chemical products
4958	Cyclohexanemethanamine, 5-amino-1,3,3-trimethyl-	2855-13-2	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
4959	Benzeneacetonitrile, 2-chloro-	2856-63-5	Contains (regardless of intentional or impurities)	chemical products
4960	Stannane, ((p-acetamidobenzoyloxy)tributyl-	2857-03-6	Contains (regardless of intentional or impurities)	chemical products
4961	Di-n-butyltin diiodide	2865-19-2	Contains (regardless of intentional or impurities)	chemical products
4962	10H-Phenoxarsine, 10-chloro-	2865-70-5	Contains (regardless of intentional or impurities)	chemical products
4963	N,N-Dimethylaminoethyl methacrylate	2867-47-2	Contains (regardless of intentional or impurities)	chemical products
4964	Disodium 3,3'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis(4-aminonaphthalene-1-sulphonate)	2868-75-9	Intentional addition / 100ppm	chemical products
4965	Benzoic acid, 5-[[4-[(2,6-diamino-3-methyl-5-sulfonylphenoxy)azo]-3,3'-dimethyl[1,1'-biphenyl]-4-yl]azo]-2-hydroxy-3-methyl-, disodium salt	2868-76-0	Intentional addition / 100ppm	chemical products
4966	Benzoselenazolium, 3-ethyl-2-methyl-, iodide	2870-37-3	Contains (regardless of intentional or impurities)	chemical products
4967	Benzoselenazolium, 3-ethyl-5-methoxy-2-methyl-, iodide	2870-38-4	Contains (regardless of intentional or impurities)	chemical products
4968	Formic acid, tin(2+) salt	2873-85-8	Intentional addition / 1,000ppm	chemical products
4969	Trichloro(triethylamine)boron	2890-88-2	Intentional addition / 1%	chemical products
4970	Dichloroacetic acid, sodium salt	2893-78-9	Contains (regardless of intentional or impurities)	chemical products
4971	C.I. Direct Brown 6	2893-80-3	Contains (regardless of intentional or impurities)	chemical products
4972	Tri-p-tolylarsine	2898-10-8	Contains (regardless of intentional or impurities)	chemical products
4973	DL-Selenocystine	2897-21-4	Contains (regardless of intentional or impurities)	chemical products
4974	Acetoxystyrene	2897-46-3	Contains (regardless of intentional or impurities)	chemical products
4975	2-Fluorobenzenesulfonyl chloride	2905-21-7	Contains (regardless of intentional or impurities)	chemical products
4976	2,4-Diphenyl-6-(4-methoxyphenyl)pyrylium tetrafluoroborate	2907-13-3	Intentional addition / 1%	chemical products
4977	Pyrylium, 4-(4-methoxyphenyl)-2,6-diphenyl-, tetrafluoroborate(1-)	2907-20-2	Intentional addition / 1%	chemical products
4978	Barium diethanolate	2914-19-4	Contains (regardless of intentional or impurities)	chemical products
4979	Barium methanolate	2914-23-0	Contains (regardless of intentional or impurities)	chemical products
4980	1,4-Dimethanesulfonyloxy-2-butyne	2917-96-6	Contains (regardless of intentional or impurities)	chemical products
4981	[1,1'-Biphenyl]-4-carbonitrile	2920-38-9	Contains (regardless of intentional or impurities)	chemical products
4982	Chloropyrifos	2921-88-2	Contains (regardless of intentional or impurities)	chemical products
4983	Boron(1), difluorobis(2-methyl-1-propanol)-, fluoride, (T-4)	2926-55-8	Contains (regardless of intentional or impurities)	chemical products
4984	Diethyl 2,6-di-tert-butyl-4-tolyl orthoate	2929-85-3	Intentional addition / 1%	chemical products
4985	Thiopyrylium, 2,6-bis(4-ethylphenyl)-4-[4-(pentyloxy)phenyl]-, perchlorate	2930-32-7	Intentional addition / 1,000ppm	chemical products
4986	Thiopyrylium, 2,6-tris(4-methoxyphenyl)-, perchlorate	2930-33-8	Intentional addition / 1,000ppm	chemical products
4987	Thiopyrylium, 4-(4-methoxyphenyl)-2,6-diphenyl-, perchlorate	2930-36-1	Intentional addition / 1,000ppm	chemical products
4988	4-Ethyl-4-formylhexanenitrile	2938-69-4	Intentional addition	chemical products
4989	4-Nitro-1H-indazole	2942-40-7	Intentional addition / 1%	chemical products
4990	Diethyl cyanidophosphate	2942-58-7	Contains (regardless of intentional or impurities)	chemical products
4991	Triethyltin iodide	2943-86-4	Contains (regardless of intentional or impurities)	chemical products
4992	Iron [R-(R'R'')-tartrate	2944-65-2	Intentional addition / 1%	chemical products
4993	Iron, [mu-(ethanedioato(2-))-O,O'-O,O']bis[ethanedioato(2-)-O,O']di-	2944-66-3	Intentional addition / 1,000ppm	chemical products
4994	Ethanedioic acid, ammonium iron(3+) salt (3:3:1)	2944-67-4	Intentional addition / 1,000ppm	chemical products
4995	Diron tritartrate	2944-68-5	Intentional addition / 1%	chemical products
4996	Benzoselenazole, 5-chloro-2-methyl-	2946-15-8	Contains (regardless of intentional or impurities)	chemical products
4997	Benzoselenazole, 5-methoxy-2-methyl-	2946-17-0	Contains (regardless of intentional or impurities)	chemical products
4998	2,5,6-trimethylbenzoselenazole	2946-20-5	Contains (regardless of intentional or impurities)	chemical products
4999	m-Methylphenylacetone	2947-60-6	Contains (regardless of intentional or impurities)	chemical products
5000	p-Tolylacetone	2947-61-7	Contains (regardless of intentional or impurities)	chemical products
5001	Tetraisopropylstannane	2949-42-0	Contains (regardless of intentional or impurities)	chemical products
5002	Pyrylium, 4-(4-methoxyphenyl)-2,6-diphenyl-, perchlorate	2970-08-3	Intentional addition / 1,000ppm	chemical products
5003	Clopidol	2971-90-6	Contains (regardless of intentional or impurities)	chemical products
5004	Diisopropyl sulfate	2973-10-6	Contains (regardless of intentional or impurities)	chemical products
5005	Octadecanoic acid, iron(2+) salt	2980-59-8	Intentional addition / 1%	chemical products
5006	Glycine, N-ethyl-N-[(heptadecafluorooctyl)sulfonyl]-, potassium salt	2991-51-7	Contains (regardless of intentional or impurities)	chemical products
5007	Bis(2-chloroethyl)carbamoyl chloride	2998-56-3	Contains (regardless of intentional or impurities)	chemical products
5008	1,1'-Biphenyl, 4,4'-diido-	3001-15-8	Intentional addition / 1,000ppm	chemical products
5009	Anilinoacetone	3009-87-0	Intentional addition	chemical products
5010	Acetone, (diethylamino)-	3010-02-4	Intentional addition	chemical products
5011	(Butylamino)acetone	3010-04-6	Intentional addition	chemical products
5012	Thioyanic acid, cobalt(2+) salt	3017-60-5	Intentional addition / 1,000ppm	chemical products
5013	1-Hexene, 2-bromo-	3017-66-1	Intentional addition / 1,000ppm	chemical products
5014	1-Decene, 2-bromo-	3017-67-2	Intentional addition / 1,000ppm	chemical products
5015	cis-2-Bromo-2-butene	3017-68-3	Intentional addition / 1,000ppm	chemical products
5016	1-Bromo-2-methylpropene	3017-69-4	Intentional addition / 1,000ppm	chemical products
5017	2-Butene, 2-bromo-3-methyl-	3017-70-7	Intentional addition / 1,000ppm	chemical products
5018	Propane, 2-bromo-1-chloro-	3017-95-6	Contains (regardless of intentional or impurities)	chemical products
5019	1-Bromo-2-chloropropane	3017-96-7	Contains (regardless of intentional or impurities)	chemical products
5020	Dichloroacetone	3018-12-0	Contains (regardless of intentional or impurities)	chemical products
5021	Tin, triphenyl-, sulfate (2:1)	3021-41-8	Contains (regardless of intentional or impurities)	chemical products
5022	Stannane, bromotricyclohexyl-	3023-92-5	Contains (regardless of intentional or impurities)	chemical products
5023	Benzoic acid, cadmium salt	3026-22-0	Contains (regardless of intentional or impurities)	chemical products
5024	Ethanol, 2,2'-[(dibutylstannyl)bis(thio)]bis-	3028-81-1	Contains (regardless of intentional or impurities)	chemical products
5025	Pyrene-1-carbaldehyde	3029-19-4	Contains (regardless of intentional or impurities)	chemical products
5026	6H-1,3,2-Oxathiazin-6-one, dihydro-2,2-dioctyl-	3033-29-2	Contains (regardless of intentional or impurities)	chemical products
5027	Bis(2-dimethylaminoethyl) ether	3033-62-3	Intentional addition / 1%	chemical products
5028	Oxiranemethanaminium, N,N,N-trimethyl-, chloride	3033-77-0	Contains (regardless of intentional or impurities)	chemical products
5029	3-(2-Ammonioethyl)-5-hydroxy-1H-indolium oxalate	3036-16-6	Intentional addition	chemical products
5030	2-(Trifluoromethyl)phenylacetone	3038-47-9	Intentional addition	chemical products
5031	Aluminum, trioctadecyl-	3041-23-4	Intentional addition / 1,000ppm	chemical products
5032	Iron(2+) diformate	3047-59-4	Intentional addition / 1%	chemical products
5033	Triphenylphosphonium triphenylborate	3053-68-7	Intentional addition / 1%	chemical products
5034	Benzene-1,2,3,4,5,6-hexakis(3-oxopropanenitrile)	3055-84-3	Intentional addition	chemical products
5035	Ethanol, 2-[2-(dodecyloxy)ethoxy]-	3055-93-4	Intentional addition / 1%	chemical products
5036	Ethanol, 2-[2-[2-(dodecyloxy)ethoxy]ethoxy]-	3055-94-5	Intentional addition / 1%	chemical products
5037	3,6,9,12,15-Pentaaxaheptacosan-1-ol	3055-95-6	Intentional addition / 1%	chemical products
5038	3,6,9,12,15,18,21,24,27-Nonaoxanonatriacontan-1-ol	3055-99-0	Intentional addition / 1%	chemical products
5039	2,4,8,10-Tetraoxaspiro[5.5]undecane-3,9-dipropanenitrile	3058-04-6	Intentional addition	chemical products
5040	Benzonitrile, 4-iodo-	3058-39-7	Intentional addition	chemical products
5041	1-Cyanovinyl acetate	3061-65-2	Intentional addition	chemical products
5042	Bis(trichloromethyl)sulfone	3064-70-8	Intentional addition / 1,000ppm	chemical products
5043	beta-Butyrolactone	3068-88-0	Contains (regardless of intentional or impurities)	chemical products
5044	Heptane, 2,3-dimethyl-	3074-71-3	Contains (regardless of intentional or impurities)	chemical products
5045	2-Methyl-4-ethylhexane	3074-75-7	Intentional addition / 1,000ppm	chemical products
5046	Hexane, 3-ethyl-3-methyl-	3074-76-8	Intentional addition / 1,000ppm	chemical products
5047	3-Methyl-4-ethylhexane	3074-77-9	Intentional addition / 1,000ppm	chemical products
5048	Thiophosphoric acid O,O-diethyl O-[4-(dimethylsulfamoyl)phenyl] ester	3078-97-5	Intentional addition / 1%	chemical products
5049	1-Piperidinepropanenitrile	3088-41-3	Intentional addition	chemical products
5050	N-(2-Cyanoethyl)glycine	3088-42-4	Intentional addition	chemical products
5051	Boronic acid, B-dodecyl	3088-79-7	Intentional addition / 1%	chemical products
5052	Tributyl(oleoyloxy)stannane	3090-35-5	Contains (regardless of intentional or impurities)	chemical products
5053	Bromotripentylstannane	3091-18-7	Contains (regardless of intentional or impurities)	chemical products
5054	Monooctyltin trichloride	3091-25-6	Contains (regardless of intentional or impurities)	chemical products
5055	Monooctyltin tribromide	3091-27-8	Contains (regardless of intentional or impurities)	chemical products
5056	Stannane, chlorotricyclohexyl-	3091-32-5	Contains (regardless of intentional or impurities)	chemical products
5057	Acetic acid, iron(2+) salt	3094-87-9	Intentional addition / 1%	chemical products
5058	Glycidyl 4-tert-butylphenyl ether	3101-60-8	Contains (regardless of intentional or impurities)	chemical products
5059	Benzeneaziridium, 2,5-dimethoxy-, tetrafluoroborate(1-)	3108-15-4	Intentional addition / 1%	chemical products
5060	Octanoic acid, pentafluoro-, ethyl ester	3108-24-5	Contains (regardless of intentional or impurities)	chemical products
5061	Acetic acid, thiobis((p-bromophenyl)-, compound with strychnine (1:2), ((±))-	3113-18-6	Contains (regardless of intentional or impurities)	chemical products
5062	Diplumbane, hexaphenyl-	3124-01-4	Contains (regardless of intentional or impurities)	chemical products
5063	Dicyclohexylammonium nitrite	3129-91-7	Contains (regardless of intentional or impurities)	chemical products
5064	Octanoic acid, iron(3+) salt	3130-28-7	Intentional addition / 1%	chemical products
5065	Triethyl arsenite	3141-12-6	Contains (regardless of intentional or impurities)	chemical products
5066	2-(2-Hydroxy-5-tert-octylphenyl)benzotriazole	3147-75-9	Intentional addition / 100ppm	chemical products
5067	Vanadium, oxobis(2,4-pentanedionato-O,O)-, (SP-5-21)-	3153-26-2	Intentional addition / 1%	chemical products
5068	Tricopper(2+) bis[2-hydroxypropane-1,2,3-tricarboxylate]	3164-31-6	Intentional addition / 1,000ppm	chemical products
5069	Benzenamine, 4-chloro-2-methyl-, hydrochloride	3165-93-3	Contains (regardless of intentional or impurities)	chemical products
5070	Ethanedioic acid, beryllium salt (1:1)	3173-18-0	Contains (regardless of intentional or impurities)	chemical products
5071	Naphthalene, 1,5-diisocyanato-	3173-72-6	Contains (regardless of intentional or impurities)	chemical products
5072	Propane, 1,2,2-trichloro-	3175-23-3	Intentional addition / 1,000ppm	chemical products
5073	1,1,2-Trichloro-2-fluoropropane	3175-24-4	Intentional addition	chemical products
5074	1,1,1,2-Tetrachloro-2-fluoropropane	3175-25-5	Intentional addition	chemical products
5075	1,1,2,3-Tetrachloro-2-fluoropropane	3175-26-6	Intentional addition	chemical products
5076	Propane, 2,2-difluoro-1,1,1,3,3,3-hexachloro-	3182-26-1	Contains (regardless of intentional or impurities)	chemical products
5077	Glutamic acid, N-benzoyl-2-(phenylmethyl)-, (+)-, compound with strychnine-10-one (1:2)	3183-17-3	Contains (regardless of intentional or impurities)	chemical products
5078	Chloromethyl ethyl ether	3188-13-4	Contains (regardless of intentional or impurities)	chemical products
5079	Oxirane, [(bicyclo[2.2.1]hept-5-en-2-ylmethoxy)methyl]-	3188-75-8	Contains (regardless of intentional or impurities)	chemical products
5080	Oxiranetetracarboxylic acid	3189-43-3	Intentional addition	chemical products
5081	Sodium 4-chloromercuriobenzoate	3198-04-7	Contains (regardless of intentional or impurities)	chemical products
5082	2-tert-Butyl-4,6-dinitrophenyl acetate	3204-27-1	Contains (regardless of intentional or impurities)	chemical products
5083	L(+)-Selenomethionine	3211-76-5	Contains (regardless of intentional or impurities)	chemical products
5084	(2,6-Dichlorophenyl)acetone	3215-64-3	Contains (regardless of intentional or impurities)	chemical products
5085	(3,4-Dichlorophenyl)acetone	3218-49-3	Contains (regardless of intentional or impurities)	chemical products
5086	2-Methyloctane	3221-61-2	Intentional addition / 1,000ppm	chemical products
5087	Zirconium(2+) acetate	3227-63-2	Contains (regardless of intentional or impurities)	chemical products
5088	Propane, 1,3-dibromo-2,2-bis(bromomethyl)-	3229-00-3	Intentional addition / 1,000ppm	chemical products
5089	2-Butene-1,4-diol, 2,3-dibromo-	3234-02-4	Intentional addition / 900ppm	chemical products
5090	1,2-Dibromopentane	3234-49-9	Intentional addition / 1,000ppm	chemical products
5091	Borate(1-), tetraphenyl-, potassium	3244-41-5	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
5092	Dodecane, 1,1,1,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12-tetracosafuoro-12-iodo-2-(trifluoromethyl)-	3248-61-1	Intentional addition / 100ppm	chemical products
5093	Tetradecane, 1,1,1,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14-octacosafuoro-14-iodo-2-(trifluoromethyl)-	3248-63-3	Intentional addition / 1,000ppm	chemical products
5094	Magenta III	3248-91-7	Intentional addition / 1%	chemical products
5095	Cupric nitrate	3251-23-8	Intentional addition / 1,000ppm	chemical products
5096	Manganese diformate	3251-96-5	Contains (regardless of intentional or impurities)	chemical products
5097	Dibromoacetone	3252-43-5	Contains (regardless of intentional or impurities)	chemical products
5098	Samarium, [mu-[[ethanedioato(2-)-O,O''O,O'']]bis[ethanedioato(2-)-O,O']di-	3252-68-4	Intentional addition / 1,000ppm	chemical products
5099	1-Hexene, 2-bromo-	3252-91-3	Intentional addition / 1,000ppm	chemical products
5100	Cobalt, bis(2,2-butenedione dioximato)(1-N,N)-, (SP-4-1)-	3252-99-1	Intentional addition / 1,000ppm	chemical products
5101	Borazin, triphenyl-	3262-89-3	Intentional addition / 1%	chemical products
5102	Oxonium, triethyl-, (OC-6-11)-hexachloroantimonate(1-)	3264-67-3	Contains (regardless of intentional or impurities)	chemical products
5103	Nickel, bis(2,4-pentanedionato-O,O)-, (SP-4-1)-	3264-82-2	Contains (regardless of intentional or impurities)	chemical products
5104	Cobalt succinate	3267-76-3	Intentional addition / 1,000ppm	chemical products
5105	Tripropyltin acetate	3267-78-5	Contains (regardless of intentional or impurities)	chemical products
5106	4-Thiaphental	3268-49-3	Contains (regardless of intentional or impurities)	chemical products
5107	Octachlorodibenzo-p-dioxin	3268-87-9	Intentional addition / 1,000ppm	chemical products
5108	Praseodymium, [mu-[[ethanedioato(2-)-O,O''O,O'']]bis[ethanedioato(2-)-O,O']di-	3269-10-1	Intentional addition / 1,000ppm	chemical products
5109	Europium, [mu-[[ethanedioato(2-)-O,O''O,O'']]bis[ethanedioato(2-)-O,O']di-	3269-12-3	Intentional addition / 1,000ppm	chemical products
5110	Holmium, [mu-[[ethanedioato(2-)-O,O''O,O'']]bis[ethanedioato(2-)-O,O']di-	3269-15-6	Intentional addition / 1,000ppm	chemical products
5111	Thulium, [mu-[[ethanedioato(2-)-O,O''O,O'']]bis[ethanedioato(2-)-O,O']di-	3269-17-8	Intentional addition / 1,000ppm	chemical products
5112	Copper dipalmitate	3271-87-2	Intentional addition / 1,000ppm	chemical products
5113	4-Hydroxy-3-nitrobenzonitrile	3272-08-0	Intentional addition	chemical products
5114	Nicotine tartrate	3275-73-8	Contains (regardless of intentional or impurities)	chemical products
5115	Ethene, 1,1'-[methylenebis(sulfonyl)]bis-	3278-22-6	Contains (regardless of intentional or impurities)	chemical products
5116	Benzene, 1,3,5-tribromo-2-(2-propenyloxy)-	3278-89-5	Intentional addition / 900ppm	chemical products
5117	2,6-Dibromo-4-[(4-nitrophenyl)azo]phenol	3281-96-7	Intentional addition / 3%	chemical products
5118	2-bromo-p-terphenyl	3282-24-4	Intentional addition / 1,000ppm	chemical products
5119	Pivaloyl chloride	3282-30-2	Contains (regardless of intentional or impurities)	chemical products
5120	p-(1-Ethylhexyl)phenol	3307-00-4	Intentional addition / 1%	chemical products
5121	p-(1-Propylpentyl)phenol	3307-01-5	Intentional addition / 1%	chemical products
5122	Fujithion	3309-87-3	Intentional addition / 1%	chemical products
5123	Cyanic acid, silver(1+) salt	3315-16-0	Intentional addition / 25%	chemical products
5124	Cobalt, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-1)-	3317-67-7	Intentional addition / 1,000ppm	chemical products
5125	1,2,4-Benzenetricarboxylic acid, tris(2-ethylhexyl) ester	3319-31-1	Intentional addition / 1,000ppm	chemical products
5126	1,2-Dibromo-4-(1,2-dibromoethyl)cyclohexane	3322-93-8	Intentional addition / 900ppm	chemical products
5127	Picric acid, sodium salt	3324-58-1	Contains (regardless of intentional or impurities)	chemical products
5128	Tetramethylsuccinonitrile	3333-52-6	Contains (regardless of intentional or impurities)	chemical products
5129	Nickel(II) carbonate	3333-67-3	Contains (regardless of intentional or impurities)	chemical products
5130	2-Chloro-4-hydroxybenzonitrile	3336-16-1	Intentional addition	chemical products
5131	Tripropyltin chloride	3342-67-4	Contains (regardless of intentional or impurities)	chemical products
5132	Dodecane, 1,12-dibromo-	3344-70-5	Intentional addition / 1,000ppm	chemical products
5133	Dithianon	3347-22-6	Contains (regardless of intentional or impurities)	chemical products
5134	Formic acid, nickel(2+) salt	3349-06-2	Contains (regardless of intentional or impurities)	chemical products
5135	Nickel(2+) propionate	3349-08-4	Contains (regardless of intentional or impurities)	chemical products
5136	Stannane, dibutoxydibutyl-	3349-36-8	Contains (regardless of intentional or impurities)	chemical products
5137	Dibutylbis(octyloxy)stannane	3349-38-0	Contains (regardless of intentional or impurities)	chemical products
5138	Octadecanoic acid, manganese(2+) salt	3353-05-7	Contains (regardless of intentional or impurities)	chemical products
5139	4-Chloromethylthiazole	3364-76-9	Contains (regardless of intentional or impurities)	chemical products
5140	Hexane, 2-bromo-	3377-86-4	Intentional addition / 1,000ppm	chemical products
5141	Hexane, 3-bromo-	3377-87-5	Intentional addition / 1,000ppm	chemical products
5142	Phenol, 5-chloro-2-(4-chlorophenoxy)-	3380-30-1	Contains (regardless of intentional or impurities)	chemical products
5143	Triclosan	3380-34-5	Contains (regardless of intentional or impurities)	chemical products
5144	Octane, 1-bromo-3,7-dimethyl-	3383-83-3	Intentional addition / 1,000ppm	chemical products
5145	Tamoxifen	3383-96-6	Contains (regardless of intentional or impurities)	chemical products
5146	Trimethylindium	3385-78-2	Intentional addition / 1%	chemical products
5147	Propanenitrile, 3,3'-[1,2-ethanediylbis(oxy)]bis-	3386-87-6	Intentional addition	chemical products
5148	1,2-Dicyanocyclobutane	3398-17-6	Intentional addition	chemical products
5149	1,2,3,4-Tetrachlorobutane	3405-32-1	Intentional addition / 1,000ppm	chemical products
5150	Fast Blue B fluoroborate	3410-35-3	Contains (regardless of intentional or impurities)	chemical products
5151	Selenocyanic acid, potassium salt	3425-46-5	Contains (regardless of intentional or impurities)	chemical products
5152	1,3-Isobenzofurandione, 3a,4,7,7a-tetrahydro-5-methyl-	3425-89-6	Contains (regardless of intentional or impurities)	chemical products
5153	Lutetium, [mu-[[ethanedioato(2-)-O,O''O,O'']]bis[ethanedioato(2-)-O,O']di-	3428-45-7	Intentional addition / 1,000ppm	chemical products
5154	Tri-n-propylthyltin	3440-79-7	Contains (regardless of intentional or impurities)	chemical products
5155	Carbonic acid, copper(1+) salt	3444-14-2	Intentional addition / 1,000ppm	chemical products
5156	Hexanoic acid, 2-ethyl-, chromium(3+) salt	3444-17-5	Contains (regardless of intentional or impurities)	chemical products
5157	Formamide, N,N-bis(2-cyanoethyl)-	3445-84-9	Intentional addition	chemical products
5158	1-Hexanol, 3,5,5-trimethyl-	3452-97-9	Intentional addition / 1%	chemical products
5159	1,4-Dibromo-2-nitrobenzene	3460-18-2	Intentional addition / 1%	chemical products
5160	Dibutylbis(decyloxy)stannane	3465-75-6	Contains (regardless of intentional or impurities)	chemical products
5161	Distannoxane, 1,1,3,3-tetrabutyl-1,3-bis[(1-oxooctadecyloxy)-	3465-77-8	Contains (regardless of intentional or impurities)	chemical products
5162	D and C Orange No. 17	3468-63-1	Contains (regardless of intentional or impurities)	chemical products
5163	Bis(acetato-O)oxovanadium	3473-84-5	Intentional addition / 1%	chemical products
5164	C.I. Direct brown 59, disodium salt	3476-90-2	Contains (regardless of intentional or impurities)	chemical products
5165	Zinc carbonate (1:1)	3486-35-9	Intentional addition / 25%	chemical products
5166	1,3,2-Benzodioxaborole, 2-butoxy-	3488-87-7	Intentional addition / 1%	chemical products
5167	Heptadecane, 1-bromo-	3508-00-7	Intentional addition / 1,000ppm	chemical products
5168	Trichrynine, mono(2-acetyl-1-benzoyloctahydro-4a-hydroxy-6-oxo-8a(1H)-isouquinolinecarboxylate)	3508-71-2	Contains (regardless of intentional or impurities)	chemical products
5169	Blasticidin S hydrochloride	3513-03-9	Intentional addition / 1%	chemical products
5170	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, iron(3+) salt (1:1)	3522-50-7	Intentional addition / 1%	chemical products
5171	Hexane, 2,2,5-trimethyl-	3522-94-9	Contains (regardless of intentional or impurities)	chemical products
5172	C.I. Direct red 37	3530-19-6	Contains (regardless of intentional or impurities)	chemical products
5173	Benzenamine, 2-chloro-4,6-dinitro-	3531-19-9	Contains (regardless of intentional or impurities)	chemical products
5174	Tetraisobutyltin	3531-43-9	Contains (regardless of intentional or impurities)	chemical products
5175	Veratroyl chloride	3535-37-3	Contains (regardless of intentional or impurities)	chemical products
5176	Thallium thiocyanate	3535-84-0	Contains (regardless of intentional or impurities)	chemical products
5177	Selenocystamine dihydrochloride	3542-13-0	Intentional addition / 1,000ppm	chemical products
5178	Diocetyl tin dichloride	3542-36-7	Contains (regardless of intentional or impurities)	chemical products
5179	4-Aminophenylacetone	3544-25-0	Contains (regardless of intentional or impurities)	chemical products
5180	Disodium 3-[(O-arsonophenyl)azo]-4,5-dihydroxynaphthalene-2,7-disulphonate	3547-38-4	Contains (regardless of intentional or impurities)	chemical products
5181	C.I. Food Red 6	3564-09-8	Contains (regardless of intentional or impurities)	chemical products
5182	1,3-Naphthalenedisulfonic acid, 7-hydroxy-8-[[4-[[[4-(methylphenyl)sulfonyl]oxy]phenyl]azo][1,1'-biphenyl]-4-yl]azo]-, disodium salt	3567-65-5	Contains (regardless of intentional or impurities)	chemical products
5183	2-(2-Formylhydrazino)-4-(5-nitro-2-furyl)thiazole	3570-75-0	Contains (regardless of intentional or impurities)	chemical products
5184	Stannane, dioctylthio-	3572-47-2	Contains (regardless of intentional or impurities)	chemical products
5185	Stannane, difluorodimethyl-	3582-17-0	Contains (regardless of intentional or impurities)	chemical products
5186	Ethylene glycol bis(semiformal)	3586-35-8	Intentional addition / 100ppm	chemical products
5187	Tributylphosphorystannane	3587-18-6	Contains (regardless of intentional or impurities)	chemical products
5188	2,2-Dibutyl-1,3,2-dioxastannolane	3590-59-8	Contains (regardless of intentional or impurities)	chemical products
5189	Tetrahexystannane	3590-83-8	Contains (regardless of intentional or impurities)	chemical products
5190	Stannane, tetraoctyl-	3590-84-9	Contains (regardless of intentional or impurities)	chemical products
5191	1,3,7,2-Dioxathiastannecane-4,10-dione, 2,2-dicytl-	3594-15-8	Intentional addition / 1,000ppm	chemical products
5192	Disodium [4-[(4,6-diamino-1,3,5-triazin-2-yl)amino]phenyl]arsenate	3599-28-8	Contains (regardless of intentional or impurities)	chemical products
5193	Bromo(3-bromopropyl)triphenylphosphorus	3607-17-8	Contains (regardless of intentional or impurities)	chemical products
5194	Acetamide, N-[5-bis[2-(acetyloxy)ethyl]amino]-2-[(2-bromo-4,6-dinitrophenyl)azo]-4-methoxyphenyl]-	3618-72-2	Contains (regardless of intentional or impurities)	chemical products
5195	C.I. Direct Black 29	3626-23-1	Intentional addition / 100ppm	chemical products
5196	C.I. Direct green 1, disodium salt	3626-28-6	Contains (regardless of intentional or impurities)	chemical products
5197	Benzoic acid, 5-[[4-[[[4-[(3-carboxy-4-hydroxyphenyl)azo][1,1'-biphenyl]-4-yl]azo]-7-sulfo-1-naphthalenyl]azo]-2-hydroxy-, trisodium salt	3626-29-7	Intentional addition / 100ppm	chemical products
5198	1-Methyl-4-phenylpiperidine-4-carbonitrile	3627-62-1	Intentional addition	chemical products
5199	Tri-n-propyl-n-butyltin	3634-62-6	Contains (regardless of intentional or impurities)	chemical products
5200	Difetarson	3639-19-8	Contains (regardless of intentional or impurities)	chemical products
5201	Antimony triacetate	3643-76-3	Intentional addition / 1,000ppm	chemical products
5202	Triphenyl tin laurate	3644-29-9	Intentional addition / 1,000ppm	chemical products
5203	p-Nitrophenoxyltributyltin	3644-32-4	Contains (regardless of intentional or impurities)	chemical products
5204	(2-biphenyloxy)tributyltin	3644-37-9	Contains (regardless of intentional or impurities)	chemical products
5205	1,2-Benzenedicarboxylic acid, diundecyl ester	3648-20-2	Intentional addition / 100ppm	chemical products
5206	Distannoxane, 1,1,3,3-tetrabutyl-1,3-bis[(1-oxododecyloxy)-	3669-02-1	Contains (regardless of intentional or impurities)	chemical products
5207	Propanoic acid, 2,3-dichloro- methyl ester	3674-09-7	Intentional addition / 1%	chemical products
5208	Butane, 1,1,2-tribromo-	3675-68-1	Intentional addition / 1,000ppm	chemical products
5209	Butane, 1,2,2-tribromo-	3675-69-2	Intentional addition / 1,000ppm	chemical products
5210	(Cyclohexyloxy)methylloxirane	3681-02-5	Contains (regardless of intentional or impurities)	chemical products
5211	1-Naphthalenesulfonic acid, 4-[[1-hydroxy-6-[[[5-hydroxy-6-[[2-methoxyphenyl]azo]-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-3-sulfo-2-naphthalenyl]azo]-, trisodium salt	3687-80-7	Intentional addition / 100ppm	chemical products
5212	Disodium 4-[(O-arsonophenyl)azo]-3-hydroxynaphthalene-2,7-disulphonate	3688-92-4	Contains (regardless of intentional or impurities)	chemical products
5213	Sulfotep	3689-24-5	Contains (regardless of intentional or impurities)	chemical products
5214	Chlorophacinone	3691-35-8	Contains (regardless of intentional or impurities)	chemical products
5215	1,1,3,3-Propanetetracarbitrile	3695-98-5	Intentional addition	chemical products
5216	Pyridine, 2,2'-dithiobis-, 1,1'-dioxide	3696-28-4	Intentional addition / 1,000ppm	chemical products
5217	Chromium(3+) palmitate	3700-69-4	Intentional addition / 1,000ppm	chemical products
5218	Acetic acid, (4-biphenyl)sulfonyl-, compound with strychnine (1:1), (+)	3708-20-1	Contains (regardless of intentional or impurities)	chemical products
5219	Ethanamine, N-ethyl-N-hydroxy-	3710-84-7	Intentional addition / 1%	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
5220	Tris(2-methylpentyl)aluminium	3711-23-7	Intentional addition / 1,000ppm	chemical products
5221	Methanaminium, N-(chloromethylene)-N-methyl-, chloride	3724-43-4	Contains (regardless of intentional or impurities)	chemical products
5222	Chlordene	3734-48-3	Intentional addition / 6%	chemical products
5223	Nonachlor	3734-49-4	Intentional addition / 6%	chemical products
5224	1,3,2-Dioxathiolane, 2-oxide	3741-38-6	Contains (regardless of intentional or impurities)	chemical products
5225	Nonane, 2-bromo-, (R)-	3749-98-2	Intentional addition / 1,000ppm	chemical products
5226	Fenthion-sulfoxide	3761-41-9	Intentional addition / 1%	chemical products
5227	2,7-Naphthalenedisulfonic acid, 4-[[2,4-dimethylphenylazo]-3-hydroxy-, disodium salt	3761-53-3	Contains (regardless of intentional or impurities)	chemical products
5228	Phenol, 2-(1-methylpropyl)-, methylcarbamate	3769-81-2	Contains (regardless of intentional or impurities)	chemical products
5229	1-Naphthalenesulfonyl chloride, 6-diazo-5,6-dihydro-5-oxo-	3770-87-6	Contains (regardless of intentional or impurities)	chemical products
5230	2-[[2-(2-Arsenophenyl)azo]-1,8-dihydroxy-3,6-disulpho-2-naphthyl]azo]benzoic acid	3772-44-9	Contains (regardless of intentional or impurities)	chemical products
5231	Boron, trifluoro(2-propanamine)-, (T-4)-	3776-44-3	Intentional addition / 1%	chemical products
5232	2,2,6,6-Tetrachlorocyclohexan-1-one	3776-30-5	Contains (regardless of intentional or impurities)	chemical products
5233	Phosphoric acid, monobutyl ester, barium salt (1:1)	3781-57-5	Intentional addition / 1,000ppm	chemical products
5234	Phenol, 2,4,6-trichloro-, sodium salt	3784-03-0	Intentional addition / 1,000ppm	chemical products
5235	O-(2,4-Dichlorophenyl) O-ethyl phenylphosphonothioate	3792-59-4	Intentional addition / 1%	chemical products
5236	Diphenoxylate hydrochloride	3810-80-8	Intentional addition	chemical products
5237	Potassium chlorate	3811-04-9	Contains (regardless of intentional or impurities)	chemical products
5238	Salithion	3811-49-2	Contains (regardless of intentional or impurities)	chemical products
5239	C.I. Direct brown 1	3811-71-0	Contains (regardless of intentional or impurities)	chemical products
5240	2-Pyridinethiol, 1-oxide, sodium salt (1:1)	3811-73-2	Intentional addition / 1,000ppm	chemical products
5241	Acetic acid, (2,4,5-trichlorophenoxy)-, compound with 2,2',2''-nitritoltris(ethanol) (1:1)	3813-14-7	Intentional addition / 1,000ppm	chemical products
5242	Pentane, 3-(bromomethyl)-	3814-34-4	Intentional addition / 1,000ppm	chemical products
5243	1,1'-Biphenyl, 4-cyclohexyl-	3842-58-8	Intentional addition / 1%	chemical products
5244	Chromium triacetate, pure	3843-17-2	Intentional addition / 1,000ppm	chemical products
5245	C.I. Acid Blue 9, disodium salt	3844-45-9	Intentional addition / 1,000ppm	chemical products
5246	4-Chlorobenzaldehyde oxime	3848-36-0	Contains (regardless of intentional or impurities)	chemical products
5247	3,3-Dimethyl-2-bromomethyl-1-butene	3854-52-2	Intentional addition / 1,000ppm	chemical products
5248	4-Cyano-2,6-diiodophenyl octanoate	3861-47-0	Contains (regardless of intentional or impurities)	chemical products
5249	Arsenazo I	3861-75-4	Contains (regardless of intentional or impurities)	chemical products
5250	Dimethylbis(oleoyloxy)stannane	3865-34-7	Contains (regardless of intentional or impurities)	chemical products
5251	Dimethylbis(palmitoyloxy)stannane	3865-35-8	Contains (regardless of intentional or impurities)	chemical products
5252	Ammonium, (2-hydroxypropyl)trimethyl-, iodide, methylphosphonofluoridate	3873-20-9	Intentional addition / 1,000ppm	chemical products
5253	Triphenylphosphine selenide	3878-44-2	Contains (regardless of intentional or impurities)	chemical products
5254	Nickel, bis[O-(1-methylethyl) carbonodithioato-kappa.S,kappa.S']-(SP-4-1)-	3882-73-3	Contains (regardless of intentional or impurities)	chemical products
5255	Copper(2+) octanoate	3890-89-9	Intentional addition / 1,000ppm	chemical products
5256	Phenol, 2-(5-chloro-2H-benzotriazol-2-yl)-6-(1,1-dimethylethyl)-4-methyl-	3896-11-5	Intentional addition / 100ppm	chemical products
5257	2-Chlorobenzeneboronic acid	3900-89-8	Intentional addition / 1%	chemical products
5258	Cyclohexanebutanoic acid, nickel(2+) salt	3906-55-6	Contains (regardless of intentional or impurities)	chemical products
5259	Tributylcyclopenta-2,4-dienylstannane	3912-86-5	Contains (regardless of intentional or impurities)	chemical products
5260	Undecane, 1,1,1-trichloro-	3922-25-6	Intentional addition / 1,000ppm	chemical products
5261	Tridecane, 1,1,1,1,3-tetrachloro-	3922-33-6	Intentional addition / 1,000ppm	chemical products
5262	Undecane, 1,1,1,1,1-tetrachloro-	3922-34-7	Intentional addition / 1,000ppm	chemical products
5263	1,1,1,7-Tetrachloroheptane	3922-36-9	Intentional addition / 1,000ppm	chemical products
5264	Sodium chloroacetate	3926-62-3	Contains (regardless of intentional or impurities)	chemical products
5265	2,4-Difluorobenzonitrile	3939-09-1	Intentional addition	chemical products
5266	Carbamic acid, methyl-, 2-chlorophenyl ester	3942-54-9	Intentional addition	chemical products
5267	Diazenedicarboxylic acid, barium salt (1:1)	3955-25-7	Intentional addition / 1,000ppm	chemical products
5268	Dimethyltin dicitrate	3955-81-5	Intentional addition / 1,000ppm	chemical products
5269	Triphenylstibine sulphide	3958-19-8	Contains (regardless of intentional or impurities)	chemical products
5270	Benzene, 1-(bromomethyl)-3-nitro-	3958-57-4	Intentional addition / 1%	chemical products
5271	4-Chloro-1,3-dioxolan-2-one	3967-54-2	Contains (regardless of intentional or impurities)	chemical products
5272	4,5-Dichloro-1,3-dioxolan-2-one	3967-55-3	Contains (regardless of intentional or impurities)	chemical products
5273	p-Tolylarsinic acid	3969-54-8	Contains (regardless of intentional or impurities)	chemical products
5274	Benzene, 1-chloro-4-(1,1-dimethylethyl)-	3972-58-3	Intentional addition / 1,000ppm	chemical products
5275	Boron, trithydro(2-methylpyridine)-, (T-4)-	3989-38-0	Contains (regardless of intentional or impurities)	chemical products
5276	Boron, (2,6-dimethylpyridine)trihydro-, (T-4)-	3989-42-6	Intentional addition / 1%	chemical products
5277	Isopropyl glycidyl ether	4018-14-2	Contains (regardless of intentional or impurities)	chemical products
5278	Hexadecanoic acid, 2-sulfo-, 1-methyl ester, sodium salt	4018-24-4	Intentional addition / 1%	chemical products
5279	Propanenitrile, 3,3,3'-phosphinidynetris-	4023-53-4	Intentional addition	chemical products
5280	Tributylstearoyloxy)stannane	4027-13-8	Contains (regardless of intentional or impurities)	chemical products
5281	Tributyltin nonanoate	4027-14-9	Contains (regardless of intentional or impurities)	chemical products
5282	tributyltin cyanate	4027-17-2	Contains (regardless of intentional or impurities)	chemical products
5283	Tributyltin maleate (1:1)	4027-18-3	Contains (regardless of intentional or impurities)	chemical products
5284	3,3-Dimethylheptane	4032-86-4	Contains (regardless of intentional or impurities)	chemical products
5285	Silanamine, 1,1,1-trimethyl-N-(trimethylsilyl)-, lithium salt	4039-32-1	Contains (regardless of intentional or impurities)	chemical products
5286	1,2-Ethanediamine, N,N-bis(1,1-dimethylethyl)-	4062-60-6	Intentional addition / 1%	chemical products
5287	3,6,9,12-Tetrazaatetradecane-1,14-diamine	4067-16-7	Contains (regardless of intentional or impurities)	chemical products
5288	1,1-Dichloro-2,2,3,3-tetrafluoropropane	4071-01-6	Intentional addition / 1,000ppm	chemical products
5289	3,5,7-Triaza-1-azoniatricyclohexane-1-(3-chloro-2-propenyl)-, chloride	4080-31-3	Intentional addition / 1,000ppm	chemical products
5290	Ethanol, 2-ethoxy-, compound with boron fluoride (BF3) (1:1)	4084-36-0	Contains (regardless of intentional or impurities)	chemical products
5291	Boron, (4-chlorobenzeneamino)trifluoro-, (T-4)-	4084-48-4	Contains (regardless of intentional or impurities)	chemical products
5292	Propanoyl fluoride, 2,3,3,3-tetrafluoro-2-(1,1,2,2-tetrafluoro-2-(fluorosulfonyl)ethoxy)-	4089-57-0	Contains (regardless of intentional or impurities)	chemical products
5293	Adenosine, 2,3'-dideoxy-	4097-22-7	Contains (regardless of intentional or impurities)	chemical products
5294	Isophorone diisocyanate	4098-71-9	Contains (regardless of intentional or impurities)	chemical products
5295	Decane, 1,10-dibromo-	4101-68-2	Intentional addition / 1,000ppm	chemical products
5296	2,4-Dimethoxybenzonitrile	4107-65-7	Intentional addition	chemical products
5297	Acetic acid, (2-biphenylsulfanyl), compound with strychnine (1:1), (+)-	4109-15-3	Contains (regardless of intentional or impurities)	chemical products
5298	3,5-Dinitrobenzonitrile	4110-35-4	Intentional addition	chemical products
5299	1H-Benz[de]isoquinoline-1,3(2H)-dione, 6-bromo-2-methyl-	4116-90-9	Contains (regardless of intentional or impurities)	chemical products
5300	1-Heptene, 7-bromo-	4117-09-3	Intentional addition / 1,000ppm	chemical products
5301	2,2-dimethyl-1,3,2-oxathiastranolan-5-one	4117-92-4	Contains (regardless of intentional or impurities)	chemical products
5302	Iron tris(thiocyanate)	4119-52-2	Intentional addition / 1,000ppm	chemical products
5303	Acetic acid, trichloro-, anhydride	4124-31-6	Contains (regardless of intentional or impurities)	chemical products
5304	Methylum, dichlorophenyl-, (OC-6-11)-hexachloroantimonate(1-)	4126-81-2	Contains (regardless of intentional or impurities)	chemical products
5305	4,4'-Biphenyldiboronic acid	4151-80-8	Intentional addition / 1%	chemical products
5306	Tripropyltin methacrylate	4154-35-2	Contains (regardless of intentional or impurities)	chemical products
5307	Benzothiazole-2(3H)-thione, copper salt (2+)	4162-43-0	Intentional addition / 1,000ppm	chemical products
5308	Tetrabromobisphenol A-bisethoxylate	4162-45-2	Contains (regardless of intentional or impurities)	chemical products
5309	1,4-Dibromobenzene-d4	4165-56-4	Intentional addition / 1,000ppm	chemical products
5310	Benzoic acid, 4-(1,1-dimethylethyl)-, cadmium salt	4167-05-9	Contains (regardless of intentional or impurities)	chemical products
5311	2-Chlorobutyric acid	4170-24-5	Contains (regardless of intentional or impurities)	chemical products
5312	Crotonaldehyde	4170-30-3	Contains (regardless of intentional or impurities)	chemical products
5313	1-Nitro-2-(phenylsulfanyl)benzene	4171-83-9	Intentional addition / 1%	chemical products
5314	Acetic acid, copper salt	4180-12-5	Intentional addition / 1,000ppm	chemical products
5315	3,3'-Diaminobiphenyl-4,4'-diol	4194-40-5	Contains (regardless of intentional or impurities)	chemical products
5316	Indium(III) citrate	4194-69-8	Intentional addition / 1%	chemical products
5317	2,7-Naphthalenedisulfonic acid, 3,3'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[4,5-dihydroxy-, tetrasodium salt	4198-19-0	Intentional addition / 100ppm	chemical products
5318	Galactose 6-(bromophosphate)	4198-47-4	Contains (regardless of intentional or impurities)	chemical products
5319	Isodimethyltrimethylsilane	4206-67-1	Intentional addition / 1,000ppm	chemical products
5320	Benzoic acid, 3,5-bis(1,1-dimethylethyl)-4-hydroxy-, 2,4-bis(1,1-dimethylethyl)phenyl ester	4221-80-1	Intentional addition / 1,000ppm	chemical products
5321	(S)-Butan-2-ol	4221-99-2	Contains (regardless of intentional or impurities)	chemical products
5322	Acetic acid, zirconium(4+) salt	4229-34-9	Contains (regardless of intentional or impurities)	chemical products
5323	3-Pyridinecarbonitrile, 1,2-dihydro-6-methyl-2-oxo-	4241-27-4	Intentional addition	chemical products
5324	3,4-Dinitrobenzonitrile	4248-33-3	Intentional addition	chemical products
5325	Dibutyltin sulfide	4253-22-9	Contains (regardless of intentional or impurities)	chemical products
5326	Cyclopentane carbonitrile	4254-02-8	Contains (regardless of intentional or impurities)	chemical products
5327	Borane, aminodipentyl-	4254-95-9	Intentional addition / 1%	chemical products
5328	Zinc oxalate dihydrate	4255-07-6	Intentional addition	chemical products
5329	Zinc, bis[O-bis(2-ethylhexyl) phosphorodithioato-S,S']-, (T-4)-	4259-15-8	Intentional addition / 1,000ppm	chemical products
5330	1,1,1-Trichloropentafluoropropane	4259-43-2	Contains (regardless of intentional or impurities)	chemical products
5331	tert-Butylarsine	4262-43-5	Contains (regardless of intentional or impurities)	chemical products
5332	Antimonate(1-), hexafluoro-, (OC-6-11)-, salt with N,N,N',N'-tetrakis[4-(diethylamino)phenyl]-1,4-benzenediamine (1:1)	4263-38-1	Contains (regardless of intentional or impurities)	chemical products
5333	Eicosane, 1-bromo-	4276-49-7	Intentional addition / 1,000ppm	chemical products
5334	Butane, 2,2-dichloro-	4279-22-5	Intentional addition / 1,000ppm	chemical products
5335	Pentane, 2-bromo-2-methyl-	4283-80-1	Intentional addition / 1,000ppm	chemical products
5336	Pentane, 3-bromo-2-methyl-	4283-83-4	Intentional addition / 1,000ppm	chemical products
5337	Octanoic acid, tin salt	4288-15-7	Intentional addition / 1,000ppm	chemical products
5338	2-n-Butyl-benzol[isothiazol]-3-one	4299-07-4	Contains (regardless of intentional or impurities)	chemical products
5339	Pentane, 2-chloro-2-methyl-	4325-48-8	Intentional addition / 1,000ppm	chemical products
5340	2-Pentene, 4-bromo-2-methyl-	4325-84-2	Intentional addition / 1,000ppm	chemical products
5341	Silanol, trimethyl-, triester with boric acid (H3BO3)	4325-85-3	Intentional addition / 1%	chemical products
5342	3-(Ethoxycarbonyl)benzeneboronic acid	4334-87-6	Intentional addition / 1%	chemical products
5343	4-(Ethoxycarbonyl)benzeneboronic acid	4334-88-7	Intentional addition / 1%	chemical products
5344	C.I. Direct green 6, disodium salt	4335-09-5	Contains (regardless of intentional or impurities)	chemical products
5345	Phenol, 2-[[tributylstannyloxy]carbonyl]-	4342-30-7	Contains (regardless of intentional or impurities)	chemical products
5346	Tributyl(trichloroacetoxystannane	4342-33-0	Contains (regardless of intentional or impurities)	chemical products
5347	Tributyltin benzoate	4342-36-3	Contains (regardless of intentional or impurities)	chemical products
5348	5-Formyl-2-thiopheneboronic acid	4347-33-5	Intentional addition / 1%	chemical products
5349	Benzenamine, N-ethyl-, hydrochloride	4348-19-0	Intentional addition	chemical products
5350	Sodium tetraphenylborate (NaPh4B)	4358-26-3	Intentional addition / 1%	chemical products
5351	Copper(II) cyanide	4367-08-2	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
5352	Tris(dimethylamino)borane	4375-83-1	Intentional addition / 1%	chemical products
5353	Antimonate(1-), hexafluoro-, (OC-6-11)-, salt with N,N,N',N'-tetrakis[4-(diethylamino)phenyl]-1,4-benzenediamine (1:1)	4379-85-5	Contains (regardless of intentional or impurities)	chemical products
5354	Meralein sodium	4386-35-0	Contains (regardless of intentional or impurities)	chemical products
5355	Cadmium cinnamate	4390-97-0	Contains (regardless of intentional or impurities)	chemical products
5356	Tris, dibutylbis(carboxymethyl)thio-	4401-37-0	Intentional addition / 1,000ppm	chemical products
5357	Ethanol, 2-[2-[2-(tridecylloxy)ethoxy]ethoxy]-	4403-12-7	Intentional addition / 1%	chemical products
5358	2-Methyl-2-butenenitrile	4403-61-6	Intentional addition	chemical products
5359	Phenylboronic acid 1,3-propanediol ester	4406-77-3	Intentional addition / 1%	chemical products
5360	1H-Benzimidazole-2-acetonitrile	4414-58-4	Intentional addition	chemical products
5361	Pentanenitrile, 2,2'-azobis[2,4-dimethyl-]	4419-11-8	Contains (regardless of intentional or impurities)	chemical products
5362	Tributylstannyl 4-[[[tributylstannyl]oxy]sulphonyl]salicylate	4419-22-1	Contains (regardless of intentional or impurities)	chemical products
5363	4-Hydroxy-3-methoxybenzonitrile	4421-08-3	Intentional addition	chemical products
5364	Benzo-1,3-dioxole-5-carbonitrile	4421-09-4	Intentional addition	chemical products
5365	1-Butyl-1,1-dihydroxyborane	4428-47-5	Intentional addition / 1%	chemical products
5366	Ethylenebis(diphenylarsine)	4431-24-7	Contains (regardless of intentional or impurities)	chemical products
5367	Ethylboronic acid	4433-63-0	Intentional addition / 1%	chemical products
5368	Nonadecane, 1-bromo-	4434-66-6	Intentional addition / 1,000ppm	chemical products
5369	3,4-(Methylenedioxy)phenylacetone	4439-02-5	Contains (regardless of intentional or impurities)	chemical products
5370	Ethylene glycol monoisobutyl ether	4439-24-1	10%	chemical products
5371	Cyclohexylboronic acid	4441-56-9	Intentional addition / 1%	chemical products
5372	Hexanoic acid, 2-ethyl-, nickel(2+) salt	4454-16-4	Contains (regardless of intentional or impurities)	chemical products
5373	Cadmium diformate	4464-23-7	Contains (regardless of intentional or impurities)	chemical products
5374	Benzeneacetonitrile, alpha-acetyl-	4468-48-8	Intentional addition	chemical products
5375	4-Hydroxy-3-methoxyphenylacetone	4468-59-1	Intentional addition	chemical products
5376	Decanedioic acid, cadmium salt (1:1)	4476-04-4	Contains (regardless of intentional or impurities)	chemical products
5377	2-Naphthalenol, 1-[[[2,5-dimethyl-4-[(2-methylphenyl)azo]phenyl]azo]-	4477-79-6	Intentional addition / 100ppm	chemical products
5378	Benzenesulphonic acid, compound with aniline (1:1)	4484-20-2	Contains (regardless of intentional or impurities)	chemical products
5379	Diphenylarsenic acid	4519-32-8	Contains (regardless of intentional or impurities)	chemical products
5380	Ethanol, 2-(dodecylloxy)-	4536-30-5	Intentional addition / 1%	chemical products
5381	4-Morpholinopropanenitrile	4542-47-6	Intentional addition	chemical products
5382	Dodecanedinitrile	4543-66-2	Intentional addition	chemical products
5383	Heptane, 1,7-dibromo-	4549-31-9	Intentional addition / 1,000ppm	chemical products
5384	Octane, 1,8-dibromo-	4549-32-0	Intentional addition / 1,000ppm	chemical products
5385	Nonane, 1,9-dibromo-	4549-33-1	Intentional addition / 1,000ppm	chemical products
5386	Ethyl phenylcyanoacetate	4553-07-5	Intentional addition	chemical products
5387	Pentanedinitrile, 2-methyl-	4553-62-2	Intentional addition	chemical products
5388	Propanenitrile, 2,3-dibromo-	4554-16-9	Intentional addition / 1%	chemical products
5389	1-Hexene, 5-bromo-	4558-27-4	Intentional addition / 1,000ppm	chemical products
5390	Ethanamine, 2-chloro-N,N-dimethyl-, hydrochloride	4584-46-7	Intentional addition	chemical products
5391	2-Oxocyclohexanepropanonitrile	4594-78-9	Intentional addition	chemical products
5392	Trichloronitroethylene	4607-81-2	Intentional addition	chemical products
5393	2-Ethyl-1,2-benzisoxazole tetrafluoroborate	4611-62-5	Intentional addition / 1%	chemical products
5394	1,4-Phenylenebisboronic acid	4612-26-4	Intentional addition / 1%	chemical products
5395	Benzene, 1,3-diboronic acid	4612-28-6	Intentional addition / 1%	chemical products
5396	C.I. Direct Brown 51	4623-91-0	Intentional addition / 100ppm	chemical products
5397	4,4'-Trimethyl-2-vinyl-1,3,2-dioxaborinane	4627-10-5	Intentional addition / 1%	chemical products
5398	3-Pentanenitrile	4635-87-4	Contains (regardless of intentional or impurities)	chemical products
5399	Trimethyltin thiocyanate	4638-25-9	Contains (regardless of intentional or impurities)	chemical products
5400	Bis(tributyltin) succinate	4644-96-6	Contains (regardless of intentional or impurities)	chemical products
5401	C.I. Solvent Yellow 72	4645-07-2	Intentional addition / 1,000ppm	chemical products
5402	Silane, azidotrimethyl-	4648-54-8	Contains (regardless of intentional or impurities)	chemical products
5403	Diphenylarsenic acid	4656-80-8	Contains (regardless of intentional or impurities)	chemical products
5404	1-Hexanaminium, N,N,N-triethyl-, perchlorate	4656-81-9	Intentional addition / 1,000ppm	chemical products
5405	2-Acetoxymercuricethanol phenylmercuric lactate	4665-55-8	Contains (regardless of intentional or impurities)	chemical products
5406	Benzyl selenocyanate	4671-93-6	Contains (regardless of intentional or impurities)	chemical products
5407	4-Nonene, 1-bromo-	4676-76-0	Intentional addition / 1,000ppm	chemical products
5408	Hydrazine, trinitromethane	4682-01-3	Contains (regardless of intentional or impurities)	chemical products
5409	Hydroxylammonium oxalate (2:1)	4682-08-0	Intentional addition / 1,000ppm	chemical products
5410	Paraquat dication	4685-14-7	Contains (regardless of intentional or impurities)	chemical products
5411	Phenyl dihydrogen orthoborate	4688-74-8	Intentional addition / 1%	chemical products
5412	2-Biphenylboronic acid	4688-76-0	Intentional addition / 1%	chemical products
5413	Octanoic acid, barium salt	4698-54-2	Contains (regardless of intentional or impurities)	chemical products
5414	Dodecanoic acid, barium salt	4698-57-5	Intentional addition / 100ppm	chemical products
5415	Reaction product of 1-chloro-2,3-epoxypropane and biphenyl-4-ol	4698-46-8	Intentional addition / 1%	chemical products
5416	Nicotine, diformate	4699-61-0	Contains (regardless of intentional or impurities)	chemical products
5417	Nicotine, triacetate	4699-62-1	Contains (regardless of intentional or impurities)	chemical products
5418	Nicotine, tripropionate	4699-63-2	Contains (regardless of intentional or impurities)	chemical products
5419	Nicotine, tributyrate	4699-64-3	Contains (regardless of intentional or impurities)	chemical products
5420	Nicotine, triisobutyrate	4699-65-4	Contains (regardless of intentional or impurities)	chemical products
5421	1,3,5-Triazine-1,3,5,2H,4H,6H)-trietanol	4719-04-4	Contains (regardless of intentional or impurities)	chemical products
5422	1,2,6-Oxadithiane, 2,2,6,6-tetraoxide	4720-58-5	Contains (regardless of intentional or impurities)	chemical products
5423	9-Octadecenoic acid, 12-hydroxy-, barium salt (2:1), [R-(Z)]-	4722-99-0	Contains (regardless of intentional or impurities)	chemical products
5424	Heptane, 2-bromo-6-methyl-	4730-24-9	Intentional addition / 1,000ppm	chemical products
5425	Bis(2-chloroethyl) selenide	4730-83-0	Contains (regardless of intentional or impurities)	chemical products
5426	Aluminum, tris(1,1-dimethylethyl)-	4731-36-6	Intentional addition / 1,000ppm	chemical products
5427	Dibutylbis(octanoyloxy)stannane	4731-77-5	Contains (regardless of intentional or impurities)	chemical products
5428	3,6-Dihydroxyphthalonitrile	4733-50-0	Contains (regardless of intentional or impurities)	chemical products
5429	1,5,9-Cyclododecatriene, (Z,Z,Z)-	4736-48-5	Intentional addition / 1%	chemical products
5430	[[[tetrathaloylbis(oxy)]bis(tributylstannane)]	4756-53-0	Contains (regardless of intentional or impurities)	chemical products
5431	Triphenylstibine oxide	4756-75-6	Contains (regardless of intentional or impurities)	chemical products
5432	6-Nitro-1H-indole	4769-96-4	Contains (regardless of intentional or impurities)	chemical products
5433	Nicotine, isovalerate (1:3)	4777-37-1	Contains (regardless of intentional or impurities)	chemical products
5434	2-Butene, 1-bromo-	4784-77-4	Intentional addition / 1,000ppm	chemical products
5435	2-Butenenitrile	4786-20-3	Contains (regardless of intentional or impurities)	chemical products
5436	10-[[[Dimethylthiocarbonyl]thio]-5,10-dihydrophenarsazine	4808-24-6	Contains (regardless of intentional or impurities)	chemical products
5437	Bis(tributyltin) sulfide	4808-30-4	Contains (regardless of intentional or impurities)	chemical products
5438	Strychnidin-10-one, 2,3-dimethoxy-, sulfate (2:1)	4845-99-2	Contains (regardless of intentional or impurities)	chemical products
5439	Acetic acid, sulfinylbis(p-bromophenyl)-, (+)-, compound with strychnine (1:2)	4850-67-3	Contains (regardless of intentional or impurities)	chemical products
5440	Boron, trihydro(morpholine-N4)-, (T-4)-	4856-95-5	Intentional addition / 1%	chemical products
5441	2,3-Dichloropyrazine	4858-85-9	Contains (regardless of intentional or impurities)	chemical products
5442	2-Octene, 8-bromo-2,6-dimethyl-	4895-14-1	Intentional addition / 1,000ppm	chemical products
5443	1,5,9-Cyclododecatriene	4904-61-4	Intentional addition / 1%	chemical products
5444	2-Bromo-4-methylpyridine	4926-28-7	Contains (regardless of intentional or impurities)	chemical products
5445	1,3,2-Dioxastibolane	4933-27-1	Intentional addition / 1,000ppm	chemical products
5446	Isobutyl 2,4,5-trichlorophenoxyacetate	4938-72-1	Intentional addition / 1,000ppm	chemical products
5447	1-Cyano-N-phenyl formthioamide	4955-82-2	Intentional addition	chemical products
5448	2-(Bromomethyl)-1,3,4-trichlorobenzene	4960-48-9	Intentional addition / 1,000ppm	chemical products
5449	Triethylarsine oxide	4964-14-1	Contains (regardless of intentional or impurities)	chemical products
5450	Ethyl acetamidocyanacetate	4977-62-2	Intentional addition	chemical products
5451	2-Benzothiazosulfenamide, N,N-dicyclohexyl-	4979-32-2	Intentional addition / 1%	chemical products
5452	Benzenediazonium, 2,5-diethoxy-4-(4-morpholinyl)-, tetrafluoroborate(1-)	4979-72-0	Contains (regardless of intentional or impurities)	chemical products
5453	2-Propenoic acid, 2-methyl-, 3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14,15,15,16,16,16-nonacosafluorohexadecyl ester	4980-53-4	Intentional addition / 100ppm	chemical products
5454	Dibutyltin 3,3'-thiodipropionate	4981-24-2	Intentional addition / 1,000ppm	chemical products
5455	Octanoic acid, nickel(2+) salt	4995-91-9	Contains (regardless of intentional or impurities)	chemical products
5456	alpha-Phenylpyridine-2-acetonitrile	5005-36-7	Intentional addition	chemical products
5457	3-Hexene, 1-bromo-, (Z)-	5009-31-4	Intentional addition / 1,000ppm	chemical products
5458	Propanenitrile, 3-(phosphonoxy)-, barium salt (1:1)	5015-38-3	Contains (regardless of intentional or impurities)	chemical products
5459	Oxiranemethanamine, N-[4-(oxiranylmethoxy)phenyl]-N'(oxiranylmethyl)-	5026-74-4	Contains (regardless of intentional or impurities)	chemical products
5460	Dichlorophenylstibine	5035-52-9	Contains (regardless of intentional or impurities)	chemical products
5461	[[[2-Ethylhexanoyloxy]diphenylstibine	5035-58-5	Contains (regardless of intentional or impurities)	chemical products
5462	Tributyl(2-ethylhexanoyloxy)stannane	5035-67-6	Contains (regardless of intentional or impurities)	chemical products
5463	Tributyl(myristoyloxy)stannane	5035-68-7	Contains (regardless of intentional or impurities)	chemical products
5464	Iron(3+) ethanolate	5058-42-4	Intentional addition / 1%	chemical products
5465	4-(Dipropylamino)benzenediazonium tetrafluoroborate	5059-80-3	Intentional addition / 1%	chemical products
5466	Propane, 2,3-dibromo-1,1,1,2,3-pentafluoro-	5061-70-1	Intentional addition / 1,000ppm	chemical products
5467	2-Butene, 1-bromo-2,3-dimethyl-	5072-70-8	Intentional addition / 1,000ppm	chemical products
5468	Methyl 3-methoxy-4-nitrobenzoic acid	5081-37-8	Contains (regardless of intentional or impurities)	chemical products
5469	4,4'-Carbonimidoylbis[N,N-dimethylaniline] acetate	5089-20-3	Contains (regardless of intentional or impurities)	chemical products
5470	Aminomalonitrile p-toluenesulphonate	5098-14-6	Intentional addition	chemical products
5471	Nonachlor, cis-	5103-73-1	Intentional addition / 6%	chemical products
5472	[[[Benzene-1,2,4,5-tetrakis(trikakis(carboxyloxy)tetraakis(tributylstannane)]	5107-58-4	Contains (regardless of intentional or impurities)	chemical products
5473	4-[[[Tributylstannyl]oxy]carbonyl]pyridine	5107-59-5	Contains (regardless of intentional or impurities)	chemical products
5474	Nonanoic acid, cadmium salt	5112-16-3	Contains (regardless of intentional or impurities)	chemical products
5475	Selenourea, N,N-dimethyl-	5117-16-8	Contains (regardless of intentional or impurities)	chemical products
5476	Selenourea, N,N-diethyl-	5117-17-9	Contains (regardless of intentional or impurities)	chemical products
5477	4-Biphenylboronic acid	5122-94-1	Intentional addition / 1%	chemical products
5478	3-Biphenylboronic acid	5122-95-2	Intentional addition / 1%	chemical products
5479	Cyclohexane, 1,1'-methylenebis[4-isocyanato-	5124-30-1	Contains (regardless of intentional or impurities)	chemical products
5480	Heptanoic acid, copper(2+) salt	5128-10-9	Intentional addition / 1,000ppm	chemical products
5481	1,3-Benzenediamine, 4-chloro-	5131-60-2	Contains (regardless of intentional or impurities)	chemical products
5482	Octadecanoic acid, iron salt	5136-76-5	Intentional addition / 1%	chemical products
5483	2,6-Octadienenitrile, 3,7-dimethyl-	5146-66-7	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
5484	Zirconium, bis(acetato-O)oxo-	5153-24-2	Contains (regardless of intentional or impurities)	chemical products
5485	Nicotine, monoacetate	5153-84-0	Contains (regardless of intentional or impurities)	chemical products
5486	(E)-1-Chloro-4-(2-nitroethenyl)benzene	5153-70-8	Contains (regardless of intentional or impurities)	chemical products
5487	Benzenesulfonic acid, 5-chloro-2-[(2-hydroxy-1-naphthalenyl)azo]-4-methyl-, barium salt (2:1)	5160-02-1	Contains (regardless of intentional or impurities)	chemical products
5488	1-Butene, 4-bromo-	5162-44-7	Contains (regardless of intentional or impurities)	chemical products
5489	1-Pentene, 3-bromo-2-methyl-	5166-36-9	Intentional addition / 1,000ppm	chemical products
5490	Heptane, 1-bromo-3-methyl-	5200-08-8	Intentional addition / 1,000ppm	chemical products
5491	Decan-5-ol	5205-34-5	Intentional addition / 1%	chemical products
5492	Octanoic acid, zirconium(4+) salt	5206-47-3	Contains (regardless of intentional or impurities)	chemical products
5493	Benzene, 1-chloro-4-(trichloromethyl)-	5216-25-1	Contains (regardless of intentional or impurities)	chemical products
5494	Fruit of illicium anisatum L.	5230-87-5	Intentional addition	chemical products
5495	2-Propenoic acid, 2-cyano-3,3-diphenyl-, ethyl ester	5232-09-5	Intentional addition	chemical products
5496	Ouirane, [(4-aziridinophenoxy)methyl]-	5255-75-4	Contains (regardless of intentional or impurities)	chemical products
5497	1,1-dihydro-6H-imino-6-silolene	5270-30-4	Contains (regardless of intentional or impurities)	chemical products
5498	2,2,7,7-Tetrabutyl-1,3,6,8,2,7-tetroxadistannecane	5271-60-3	Contains (regardless of intentional or impurities)	chemical products
5499	3,6,9,12-Tetraoxatetracosan-1-ol	5274-68-0	Intentional addition / 1%	chemical products
5500	C.I. Pigment Red 48:4	5280-66-0	Contains (regardless of intentional or impurities)	chemical products
5501	Benzenesulfonic acid, 3-nitro-4-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]-barium salt (2:1)	5280-69-3	Contains (regardless of intentional or impurities)	chemical products
5502	Cyclopropanecarboxylic acid, 2,2-dimethyl-3-(2-methyl-1-propenyl)-, (1,3,4,5,6,7-hexahydro-1,3-dioxo-2H-isoindol-2-yl)methyl ester, (1R,3R)-rel-	5284-41-3	Intentional addition / 1%	chemical products
5503	Benzo[thiazolium, 3,3'-(1,10-decandienyl)bis-, diperchlorate	5284-75-3	Intentional addition / 1,000ppm	chemical products
5504	2-Methoxy-5-methyl-p-phenylenediamine	5307-00-6	Intentional addition / 1,000ppm	chemical products
5505	2-Nitro-p-phenylenediamine	5307-14-2	Intentional addition / 1,000ppm	chemical products
5506	Phenol, 2,4-dinitro-, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine	5308-71-4	Contains (regardless of intentional or impurities)	chemical products
5507	Borane, chlorodiethyl-	5314-83-0	Intentional addition / 1%	chemical products
5508	1-Pyrenol	5315-79-7	Contains (regardless of intentional or impurities)	chemical products
5509	[1,1'-Biphenyl]-3-carboxylic acid, 2-hydroxy-, copper(2+) salt (2:1)	5328-04-1	Intentional addition / 1,000ppm	chemical products
5510	Butanenitrile, 4-bromo-	5332-06-9	Contains (regardless of intentional or impurities)	chemical products
5511	1,3-Isobenzofurandione, 3a,4,7,7a-tetrahydro-4-methyl-	5333-84-6	Contains (regardless of intentional or impurities)	chemical products
5512	5-Amino-1-phenyl-1H-pyrazole-4-carbonitrile	5334-43-0	Intentional addition	chemical products
5513	4-Diethylaminobutyronitrile	5336-75-4	Intentional addition	chemical products
5514	Boric acid (H3BO3), trihexyl ester	5337-36-0	Intentional addition / 1%	chemical products
5515	Tris(2-chlorophenyl) borate	5337-60-0	Intentional addition / 1%	chemical products
5516	4-Nitrophenethyl bromide	5339-26-4	Contains (regardless of intentional or impurities)	chemical products
5517	Hydrazine, dihydrochloride	5341-61-7	Contains (regardless of intentional or impurities)	chemical products
5518	Acetic acid 1,2-dimethylpropyl ester	5343-96-4	Intentional addition / 1,000ppm	chemical products
5519	Acetic acid, thiocyanato-, ethyl ester	5349-28-0	Intentional addition / 1%	chemical products
5520	N-(4-Bromobutyl)phthalimide	5394-18-3	Contains (regardless of intentional or impurities)	chemical products
5521	Stibine, tris(4-methylphenyl)-	5395-43-7	Contains (regardless of intentional or impurities)	chemical products
5522	Imidazo[4,5-d]imidazole-2,5-(1H,3H)-dione, tetrahydro-1,3,4,6-tetrakis(hydroxymethyl)-	5395-50-6	Intentional addition / 1,000ppm	chemical products
5523	Hydrazinecarbothioic acid, methyl ester	5397-03-5	Contains (regardless of intentional or impurities)	chemical products
5524	2,3-Dibromopentane	5398-25-4	Intentional addition / 1,000ppm	chemical products
5525	Heptadecanenitrile	5399-02-0	Contains (regardless of intentional or impurities)	chemical products
5526	1H-Indazole, 5-nitro-	5401-94-5	Contains (regardless of intentional or impurities)	chemical products
5527	Butane, 2,3-dibromo-	5408-86-6	Intentional addition / 1,000ppm	chemical products
5528	Arsenic acid, (2-nitrophenyl)-	5410-29-7	Contains (regardless of intentional or impurities)	chemical products
5529	C.I. Acid Red 73, disodium salt	5413-75-2	Intentional addition / 100ppm	chemical products
5530	5-Bromopentanenitrile	5414-21-1	Intentional addition	chemical products
5531	Propanedinitrile, (1-ethoxyethylidene)-	5417-82-3	Intentional addition	chemical products
5532	Triisopropyl borate	5419-55-6	Contains (regardless of intentional or impurities)	chemical products
5533	1,3-Benzenediamine, 4,4'-[[4-methyl-1,3-phenylene]bis(azo)]bis[6-methyl-, dihydrochloride	5421-66-9	Intentional addition / 100ppm	chemical products
5534	C.I. Direct green 8, trisodium salt	5422-17-3	Contains (regardless of intentional or impurities)	chemical products
5535	1,2-Benzenedicarboxylic acid, monobutyl ester, copper(2+) salt	5423-38-1	Intentional addition / 1,000ppm	chemical products
5536	4-(2-Chloroacetamido)phenylarsonic acid	5425-62-7	Contains (regardless of intentional or impurities)	chemical products
5537	Propane, 1,3-dibromo-2,2-dimethyl-	5426-27-5	Intentional addition / 1,000ppm	chemical products
5538	4-Chlorophenylarsonic acid	5440-04-0	Contains (regardless of intentional or impurities)	chemical products
5539	3-Pyridinecarbonitrile, 1,2-dihydro-6-hydroxy-4-methyl-2-oxo-	5444-02-0	Intentional addition	chemical products
5540	Undecane, 5-bromo-	5447-45-0	Intentional addition / 1,000ppm	chemical products
5541	2,4-Dicyano-3-methylglutaramide	5447-66-5	Intentional addition	chemical products
5542	[1,1'-Biphenyl]-3-carboxylic acid, 2-hydroxy-, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	5456-02-0	Contains (regardless of intentional or impurities)	chemical products
5543	1,3,2-Dioxaborinane, 2,2'-[2,2-dimethyl-1,3-propanediylbis(oxy)]bis[5,5-dimethyl-	5458-05-3	Intentional addition / 1%	chemical products
5544	Trineopentyl orthoborate	5458-06-4	Intentional addition / 1%	chemical products
5545	Ethyl selenac	5458-28-0	Contains (regardless of intentional or impurities)	chemical products
5546	Indole-3-carbonitrile	5457-28-3	Intentional addition	chemical products
5547	Undeca-10-enohydrazide	5458-77-5	Contains (regardless of intentional or impurities)	chemical products
5548	Acetic acid, cyano-, butyl ester	5458-58-5	Intentional addition	chemical products
5549	1,3-Benzenediamine, 4-methyl-, monohydrochloride	5459-85-8	Intentional addition / 25%	chemical products
5550	Butylin chloride	5462-26-0	Contains (regardless of intentional or impurities)	chemical products
5551	Bis(cyanomethyl)ammonium sulphate	5466-22-8	Intentional addition	chemical products
5552	2-Butenedinitrile, 2,3-dimercapto-, disodium salt, (Z)-	5466-54-6	Intentional addition	chemical products
5553	Dihydroxy-4-bromophenylborane	5467-74-3	Intentional addition / 1%	chemical products
5554	alpha, alpha-Dicyanobenzyl benzoate	5467-94-7	Intentional addition	chemical products
5555	2H-Benzimidazole-2-thione, 1,3-dihydro-, copper(2+) salt (2:1)	5468-83-7	Intentional addition / 1,000ppm	chemical products
5556	Hydroxylamine, hydrochloride	5470-11-1	Contains (regardless of intentional or impurities)	chemical products
5557	8-[[Tributylstannyloxy]quinoline	5488-45-9	Contains (regardless of intentional or impurities)	chemical products
5558	Benzenaminium, N,N'-2,5-cyclohexadiene-1,4-diyldienebis[4-(diethylamino)-N-[4-(diethylamino)phenyl]-, bis[[OC(=O)-6-11]-hexafluoroantimonate(1-)]	5496-71-9	Contains (regardless of intentional or impurities)	chemical products
5559	Calcium [[N'-ethylenebis[N-(carboxymethyl)glycinate]](4)-N.N.O.O.'ON.ON']cuprate(2-)	5497-52-9	Intentional addition / 1,000ppm	chemical products
5560	Cyclopropanecarbonitrile	5500-21-0	Contains (regardless of intentional or impurities)	chemical products
5561	Rhodium(II) acetate	5503-41-3	Contains (regardless of intentional or impurities)	chemical products
5562	Boron, trichloro[thiobis(methane)]-, (T-4)-	5523-19-3	Intentional addition / 1%	chemical products
5563	(Z)-1,2,3,3,3-Pentafluoropropene	5528-43-8	Intentional addition / 1,000ppm	chemical products
5564	Benzyl cyanofornate	5532-86-5	Intentional addition	chemical products
5565	1,3-Dimethyl-2-selenourea	5533-46-0	Contains (regardless of intentional or impurities)	chemical products
5566	Phenyl vinyl sulphone	5535-48-8	Contains (regardless of intentional or impurities)	chemical products
5567	Benzoic acid, 3-(1-cyanoethyl)-	5537-71-3	Intentional addition	chemical products
5568	1-Octanaminium, N,N-dimethyl-N-octyl-, chloride	5538-94-3	Intentional addition / 1,000ppm	chemical products
5569	(S)-4-Hydroxy-3-(3-oxo-1-phenylbutyl)-2-benzopyrone	5543-87-7	Contains (regardless of intentional or impurities)	chemical products
5570	(R)-4-Hydroxy-3-(3-oxo-1-phenylbutyl)-2-benzopyrone	5543-88-8	Contains (regardless of intentional or impurities)	chemical products
5571	2,2-Diphenylpropionitrile	5558-67-8	Contains (regardless of intentional or impurities)	chemical products
5572	Nicotine, tris(2,4-dinitrophenyl)acetate	5562-84-1	Contains (regardless of intentional or impurities)	chemical products
5573	Boronic acid, B-(2-aminophenyl)-	5570-18-3	Intentional addition / 1%	chemical products
5574	Boronic acid, B-(2-nitrophenyl)-	5570-19-4	Intentional addition / 1%	chemical products
5575	Cyclic 3-(1,2-ethanediylacetate)-estra-5(10),9(11)-diene-3,17-dione	5571-36-8	Contains (regardless of intentional or impurities)	chemical products
5576	(R)-2-Hydroxy-alpha-[(methylamino)methyl]-1,3,2-benzodioxaborole-5-methanol	5579-16-8	Intentional addition / 1%	chemical products
5577	Nickel(2+) bis(2-carboxyacetate)	5581-60-2	Contains (regardless of intentional or impurities)	chemical products
5578	(Z,Z)-Dibutylbis[4-(cyclohexyloxy)-1,4-dioxaloyloxy]stannane	5587-52-0	Contains (regardless of intentional or impurities)	chemical products
5579	Vanadium, oxotris(2-propanolato)-, (T-4)-	5588-84-1	Intentional addition / 1%	chemical products
5580	Chromate(1-), bis(2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-, hydrogen	5601-29-6	Contains (regardless of intentional or impurities)	chemical products
5581	Methylum, oxophenyl-, (OC-6-11)-hexafluoroantimonate(1-)	5609-80-3	Contains (regardless of intentional or impurities)	chemical products
5582	Fulminating silver	5610-59-3	Intentional addition / 25%	chemical products
5583	C.I. Acid Black 52	5610-64-0	Contains (regardless of intentional or impurities)	chemical products
5584	Acetonitrile, (methylamino)-	5618-32-0	Intentional addition	chemical products
5585	N,N'-Methylethylenebismorpholine	5625-90-1	Contains (regardless of intentional or impurities)	chemical products
5586	Methyl N-cyanoacetimidate	5652-84-6	Intentional addition	chemical products
5587	2,3-Dimethoxybenzonitrile	5653-62-3	Intentional addition	chemical products
5588	Iron cyanide (Fe(CN)3)	5683-74-9	Contains (regardless of intentional or impurities)	chemical products
5589	4-Methyl-1,3,2-dioxathiolane-2,2-dioxide	5689-83-8	Contains (regardless of intentional or impurities)	chemical products
5590	Tosylacetoneitrile	5697-44-9	Intentional addition	chemical products
5591	Chloroselenobenzene	5707-04-0	Contains (regardless of intentional or impurities)	chemical products
5592	Acetoxytrimethylplumbane	5711-19-3	Contains (regardless of intentional or impurities)	chemical products
5593	2-Cyanophenyl acetate	5715-02-6	Intentional addition	chemical products
5594	Boronic acid, B-(4-methylphenyl)-	5720-05-8	Intentional addition / 1%	chemical products
5595	Boronic acid, B-(2-methoxyphenyl)-	5720-06-9	Intentional addition / 1%	chemical products
5596	4-Methoxyphenylboronic acid	5720-07-0	Intentional addition / 1%	chemical products
5597	2,3-Dimethylbenzonitrile	5724-56-1	Intentional addition	chemical products
5598	2-(Hydroxymethyl)phenylboronic acid cyclic monoester	5735-41-1	Intentional addition / 1%	chemical products
5599	Cadmium acetate dihydrate	5743-04-4	Contains (regardless of intentional or impurities)	chemical products
5600	D-Gluconic acid, cyclic 4,5-ester with boric acid, calcium salt (2:1)	5743-34-0	Intentional addition / 1%	chemical products
5601	2-Ethylhexyl 4-[[benzoylthio]dibutylstannyloxy]-4-oxoisocrotonate	5762-18-5	Contains (regardless of intentional or impurities)	chemical products
5602	Calcium bis(dimethylarsinate)	5785-43-3	Contains (regardless of intentional or impurities)	chemical products
5603	Strychnidin-10-one, 2,3-dimethoxy-, monohydrochloride	5786-96-9	Contains (regardless of intentional or impurities)	chemical products
5604	Brucine nitrate	5786-97-0	Contains (regardless of intentional or impurities)	chemical products
5605	Ethanedioic acid, calcium salt (1:1), monohydrate	5794-28-5	Intentional addition / 1,000ppm	chemical products
5606	alpha-Bromobenzyl cyanide	5798-79-8	Contains (regardless of intentional or impurities)	chemical products
5607	Dimethyl(methylthio)sulfonium tetrafluoroborate	5799-67-7	Intentional addition / 1%	chemical products
5608	2-Naphthalenylglycolic acid, 5,6,7,8-tetrahydro-, (S)-, compound with strychnine (1:1)	5803-81-6	Contains (regardless of intentional or impurities)	chemical products
5609	(Cyano-C)diethylaluminum	5804-85-3	Contains (regardless of intentional or impurities)	chemical products
5610	Bismuth, oxo(sodium arseniato)-	5806-84-8	Intentional addition / 100ppm	chemical products
5611	[4-[[4,6-Diamino-1,3,5-triazin-2-yl]amino]phenyl]arsonic acid	5806-89-3	Contains (regardless of intentional or impurities)	chemical products
5612	4-Morpholinoacetoneitrile	5807-02-3	Intentional addition	chemical products
5613	11-Cyanooundecanoic acid	5810-18-4	Intentional addition	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
5614	Arsonium, tetramethyl-, iodide	5814-20-0	Contains (regardless of intentional or impurities)	chemical products
5615	Dodecane, 1,1'-selenobis-	5819-01-2	Contains (regardless of intentional or impurities)	chemical products
5616	Phenylmercuric monoethanol ammonium acetate	5822-97-9	Contains (regardless of intentional or impurities)	chemical products
5617	Phosphorodithioic acid, S-[(ethylsulfanyl)methyl] O,O-bis(1-methylethyl) ester	5827-05-4	Contains (regardless of intentional or impurities)	chemical products
5618	Tetradecylstannane	5827-56-5	Contains (regardless of intentional or impurities)	chemical products
5619	Chlorotridodecylstannane	5827-57-6	Contains (regardless of intentional or impurities)	chemical products
5620	Stannane, dichlorododecyl-	5827-58-7	Contains (regardless of intentional or impurities)	chemical products
5621	Coumatetralyl	5836-29-3	Contains (regardless of intentional or impurities)	chemical products
5622	Bis(tricyclohexyltin) oxide	5837-26-3	Contains (regardless of intentional or impurities)	chemical products
5623	Ethanol, 2-oxo-2-((tributylstannyl)oxy)-	5847-48-3	Contains (regardless of intentional or impurities)	chemical products
5624	Tributyltin formate	5847-51-8	Contains (regardless of intentional or impurities)	chemical products
5625	Tributyltin chloroacetate	5847-52-9	Contains (regardless of intentional or impurities)	chemical products
5626	Tributyltin diethylthiocarbonylthio)stannane	5847-53-0	Contains (regardless of intentional or impurities)	chemical products
5627	Dibutyltin dibenzoate	5847-54-1	Contains (regardless of intentional or impurities)	chemical products
5628	Dibutyltin distearate	5847-55-2	Contains (regardless of intentional or impurities)	chemical products
5629	1-Cyano-2,3-dimethylisothiourea	5848-24-8	Intentional addition	chemical products
5630	Benzenesulfonic acid, 4-[(2-hydroxy-1-naphthalenyl)azo]-2-methyl-, barium salt (2:1)	5850-87-3	Contains (regardless of intentional or impurities)	chemical products
5631	C1 Acid Red 24	5858-30-0	Intentional addition / 100ppm	chemical products
5632	1-Naphthalenesulfonic acid, 4-hydroxy-3-[(2-methoxyphenyl)azo]-, monosodium salt	5858-39-9	Intentional addition / 100ppm	chemical products
5633	Disodium 4-hydroxy-3-[(2-methoxyphenyl)azo]naphthalene-2,7-disulphonate	5858-63-9	Intentional addition / 100ppm	chemical products
5634	2-Naphthalenesulfonic acid, 5-[(2-chlorophenyl)azo]-6-hydroxy-, barium salt (2:1)	5858-88-8	Contains (regardless of intentional or impurities)	chemical products
5635	2-Bromo-1,1-dichloroethylene	5870-61-1	Intentional addition / 1,000ppm	chemical products
5636	Benzene, 1-isocyanato-2-[(4-isocyanatophenyl)methyl]-	5873-54-1	Contains (regardless of intentional or impurities)	chemical products
5637	Strychnine, mono(3,4-dichlorobenzenesulfonate)	5890-10-8	Contains (regardless of intentional or impurities)	chemical products
5638	(-)-Brucine tetrahydrate	5892-11-5	Intentional addition / 100%	chemical products
5639	Sodium hydrogen (3-acetamido-4-hydroxyphenyl)arsonate	5892-48-8	Contains (regardless of intentional or impurities)	chemical products
5640	Diacetonamine acid oxalate monohydrate	5895-86-3	Intentional addition	chemical products
5641	Calcium bis(methylarsonate)	5902-95-4	Contains (regardless of intentional or impurities)	chemical products
5642	MNFA	5903-13-9	Intentional addition / 1%	chemical products
5643	Diiron trimalate	5905-51-1	Intentional addition / 1%	chemical products
5644	Ferrous lactate	5905-52-2	Intentional addition / 1%	chemical products
5645	Barium acetate monohydrate	5908-64-5	Intentional addition	chemical products
5646	Propanoic acid, barium salt	5908-77-0	Contains (regardless of intentional or impurities)	chemical products
5647	Barium disalicylate	5908-78-1	Contains (regardless of intentional or impurities)	chemical products
5648	Barium succinate	5908-80-5	Contains (regardless of intentional or impurities)	chemical products
5649	Barium tartrate	5908-81-6	Contains (regardless of intentional or impurities)	chemical products
5650	(Chloromethyl)cyclopropane	5911-08-0	Contains (regardless of intentional or impurities)	chemical products
5651	[(Hexyloxy)methyl]oxirane	5926-90-9	Contains (regardless of intentional or impurities)	chemical products
5652	Acetic acid, cobalt salt	5931-89-5	Intentional addition / 100ppm	chemical products
5653	Strychnine, citrate	5936-16-3	Contains (regardless of intentional or impurities)	chemical products
5654	4-Methoxy-1-naphthionitrile	5961-55-7	Intentional addition	chemical products
5655	Tetraethylammonium tetrachloronickelate(II)	5964-71-6	Contains (regardless of intentional or impurities)	chemical products
5656	Hydrocodone hydroiodide	5965-15-1	Intentional addition / 1,000ppm	chemical products
5657	Tripotassium tris(oxalato(2-)-O,O')antimonate(3-)	5965-33-3	Contains (regardless of intentional or impurities)	chemical products
5658	Cobalt(III) oxalate dihydrate	5965-38-8	Intentional addition / 1%	chemical products
5659	Distannoxane, 1,3-bis(acetyloxy)-1,1,3,3-tetrabutyl-	5967-09-9	Contains (regardless of intentional or impurities)	chemical products
5660	Iron tris(dimethylarsinate)	5968-84-3	Contains (regardless of intentional or impurities)	chemical products
5661	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, manganese(3+) salt (1:1)	5968-88-7	Contains (regardless of intentional or impurities)	chemical products
5662	Zinc acetate dihydrate	5970-45-6	Intentional addition / 1%	chemical products
5663	Ammonium hydrogen oxalate	5972-72-5	Intentional addition / 1,000ppm	chemical products
5664	Ethanedioic acid, monoammonium salt, monohydrate	5972-73-6	Intentional addition / 1,000ppm	chemical products
5665	Butane, 1-bromo-2-methyl-, (±)	5973-11-5	Intentional addition / 1,000ppm	chemical products
5666	Octane, 2-bromo-, (R)	5978-55-2	Intentional addition / 1,000ppm	chemical products
5667	2,4,6-Trimethylphenylboronic acid	5990-97-2	Intentional addition / 1%	chemical products
5668	D-Glucose, 6-(dihydrogen phosphate), barium salt (1:1)	5996-16-7	Contains (regardless of intentional or impurities)	chemical products
5669	Ethanedioic acid, diammonium salt, monohydrate	6009-70-7	Intentional addition / 1,000ppm	chemical products
5670	Iron di(hydrocyanate)	6010-09-9	Intentional addition / 1,000ppm	chemical products
5671	Acetonitrile, amino-, monohydrochloride	6011-14-9	Intentional addition	chemical products
5672	Gentisic acid, compound with nicotine	6012-21-1	Contains (regardless of intentional or impurities)	chemical products
5673	Nicotine, dipicrate	6012-23-3	Contains (regardless of intentional or impurities)	chemical products
5674	2-Propanoic acid, 2-methyl-, 3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14,14-pentacosafuorotetradecyl ester	6014-75-1	Intentional addition / 100ppm	chemical products
5675	Acetic acid, arsono-, disodium salt, hydrate	6018-31-1	Contains (regardless of intentional or impurities)	chemical products
5676	Nickel acetate tetrahydrate	6018-89-9	Contains (regardless of intentional or impurities)	chemical products
5677	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, nickel(2+) salt (2:3)	6018-92-4	Contains (regardless of intentional or impurities)	chemical products
5678	Nickel(II) oxalate dihydrate	6018-94-6	Contains (regardless of intentional or impurities)	chemical products
5679	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, dihydrochloride, (S)-	6019-02-9	Contains (regardless of intentional or impurities)	chemical products
5680	Nicotine hydroiodide	6019-03-0	Contains (regardless of intentional or impurities)	chemical products
5681	Nicotine dihydroiodide	6019-04-1	Contains (regardless of intentional or impurities)	chemical products
5682	Nicotine, tartrate (1:2), dihydrate	6019-06-3	Contains (regardless of intentional or impurities)	chemical products
5683	Nicotine, picrolonate	6019-09-6	Contains (regardless of intentional or impurities)	chemical products
5684	D-Fructose, 1,6-bis(dihydrogen phosphate), barium salt (1:2)	6035-52-5	Contains (regardless of intentional or impurities)	chemical products
5685	D-Fructose, 6-(dihydrogen phosphate), barium salt (1:1)	6035-54-7	Contains (regardless of intentional or impurities)	chemical products
5686	3-(2-Thienyl)acrylonitrile	6041-28-7	Intentional addition	chemical products
5687	Copper diacetate monohydrate	6046-93-1	Intentional addition / 1,000ppm	chemical products
5688	Iron(2+) dipotassium [R-(R*,R*)]tartrate	6047-13-8	Intentional addition / 1%	chemical products
5689	Iron(II) oxalate dihydrate	6047-25-2	Intentional addition / 1,000ppm	chemical products
5690	2-Furoyl cyanide	6047-91-2	Contains (regardless of intentional or impurities)	chemical products
5691	4,4'-(Ethylenedioxy)dianiline	6052-10-4	Contains (regardless of intentional or impurities)	chemical products
5692	Strychnine, p-(benzyloxy)benzenesulfonate	6056-14-0	Contains (regardless of intentional or impurities)	chemical products
5693	Tricyclohexyltin hydride	6056-50-4	Contains (regardless of intentional or impurities)	chemical products
5694	Ethanedioic acid, aluminum salt, hydrate (3:2:1)	6058-43-1	Intentional addition / 1,000ppm	chemical products
5695	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, nickel(2+) salt, hydrate (2:3:14)	6059-24-1	Contains (regardless of intentional or impurities)	chemical products
5696	Aurate(1-), tetrachloro-, (SP-4-1)-, hydrogen, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (2:1)	6059-25-2	Contains (regardless of intentional or impurities)	chemical products
5697	Pentachloropropane nitrile	6065-95-8	Intentional addition	chemical products
5698	4-Cyanobenzoyl chloride	6068-72-0	Intentional addition	chemical products
5699	Spiro[isobenzofuran-1(3H),9-[9H]xanthen]-3-one, 3',6'-bis(phenylamino)-	6080-09-7	Contains (regardless of intentional or impurities)	chemical products
5700	Benzenediazonium, 4-(ethylamino)-3-methyl-, tetrafluoroborate(1-)	6087-59-8	Intentional addition / 1%	chemical products
5701	1-Benzyl-4-hydroxypiperidine-4-carbonitrile	6094-60-6	Intentional addition	chemical products
5702	Benzenediazonium, 4-(diethylamino)-2-methyl-, tetrafluoroborate(1-)	6098-53-9	Intentional addition / 1%	chemical products
5703	Ethanedioic acid, monopotassium salt, monohydrate	6100-03-4	Intentional addition / 1,000ppm	chemical products
5704	Ethanedioic acid, potassium salt (2:1), dihydrate	6100-20-5	Intentional addition / 1,000ppm	chemical products
5705	Strychnidin-10-one, compound with arsenic acid (H3AsO4) (1:1), dihydrate	6101-00-4	Contains (regardless of intentional or impurities)	chemical products
5706	Strychnidin-10-one, sulfate (1:1), dihydrate	6101-01-5	Contains (regardless of intentional or impurities)	chemical products
5707	Strychnine camphorate	6101-02-6	Contains (regardless of intentional or impurities)	chemical products
5708	Strychnine, citrate (1:1)	6101-03-7	Contains (regardless of intentional or impurities)	chemical products
5709	Strychnine hydrochloride dihydrate	6101-04-8	Contains (regardless of intentional or impurities)	chemical products
5710	Strychnine lactate	6101-05-9	Contains (regardless of intentional or impurities)	chemical products
5711	Strychnine salicylate	6101-06-0	Contains (regardless of intentional or impurities)	chemical products
5712	Strychnine valerate	6101-07-1	Contains (regardless of intentional or impurities)	chemical products
5713	Strychnine phosphate dihydrate	6101-09-3	Contains (regardless of intentional or impurities)	chemical products
5714	Strychnine p-phenol sulfonate	6101-42-4	Contains (regardless of intentional or impurities)	chemical products
5715	epsilon-Hexachlorocyclohexane	6108-10-7	Contains (regardless of intentional or impurities)	chemical products
5716	Pentane, 2-chloro-2,4,4-trimethyl-	6111-88-2	Intentional addition / 1,000ppm	chemical products
5717	Hexane, 3-methyl-, (S)-	6131-24-4	Intentional addition / 1%	chemical products
5718	Arsenate, dimethyl, sodium	6131-99-3	Contains (regardless of intentional or impurities)	chemical products
5719	3-Acetylbenzonitrile	6136-68-1	Intentional addition	chemical products
5720	Acetonitrile, diethoxy-	6136-93-2	Intentional addition	chemical products
5721	3-Heptanone, 4-methyl-	6137-11-7	Intentional addition / 1,000ppm	chemical products
5722	4-Formyl-4-methylvaleronitrile	6140-61-0	Intentional addition	chemical products
5723	5-Nitroindole	6146-52-7	Contains (regardless of intentional or impurities)	chemical products
5724	Manganese dibutylate	6147-00-8	Contains (regardless of intentional or impurities)	chemical products
5725	Acetic acid, cobalt(2+) salt, tetrahydrate	6147-53-1	Contains (regardless of intentional or impurities)	chemical products
5726	Magnesium oxalate dihydrate	6150-86-5	Intentional addition / 1,000ppm	chemical products
5727	Magnesium, bis(2-hydroxybenzoato-O1,O2)-, tetrahydrate, (T-4)-	6150-94-3	Contains (regardless of intentional or impurities)	chemical products
5728	Ethanedioic acid, dihydrate	6153-56-6	Intentional addition / 1,000ppm	chemical products
5729	Acetic acid, manganese(2+) salt, tetrahydrate	6156-78-1	Contains (regardless of intentional or impurities)	chemical products
5730	Strychnine formate	6158-11-8	Contains (regardless of intentional or impurities)	chemical products
5731	Strychnine hypophosphite dihydrate	6158-12-9	Contains (regardless of intentional or impurities)	chemical products
5732	Uranium, bis(acetato-O)dioxo-, dihydrate	6159-44-0	Contains (regardless of intentional or impurities)	chemical products
5733	Nicotine, phthalate	6159-83-7	Contains (regardless of intentional or impurities)	chemical products
5734	Strontium oxalate monohydrate	6160-36-7	Intentional addition / 1,000ppm	chemical products
5735	Chlordimeform	6164-98-3	Contains (regardless of intentional or impurities)	chemical products
5736	Boric acid, B-2-thienyl-	6165-68-0	Intentional addition / 1%	chemical products
5737	3-Thienylboronic acid	6165-69-1	Intentional addition / 1%	chemical products
5738	Zincate (2-), (T-4)-, dihydrogen, compound with (S)-2-(1-methyl-2-pyrrolidinyl)pyridine (1:1), monohydrate	6169-10-4	Contains (regardless of intentional or impurities)	chemical products
5739	Antimony lithium thiomalate nonahydrate	6169-12-6	Contains (regardless of intentional or impurities)	chemical products
5740	Stannane-d, tributyl-	6180-99-0	Contains (regardless of intentional or impurities)	chemical products
5741	1-Propene, 3-chloro-2-fluoro-	6186-91-0	Intentional addition / 1,000ppm	chemical products
5742	Pentane, 1-bromo-3,3-dimethyl-	6188-50-7	Intentional addition / 1,000ppm	chemical products
5743	Nicotine, dipicolonate	6191-53-3	Contains (regardless of intentional or impurities)	chemical products
5744	Benzenesulfonic acid, 4-(phenylamino)-, barium salt (2:1)	6211-24-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
5745	Diphenylhydroxyarsine	6217-24-9	Intentional addition / 1,000ppm	chemical products
5746	TFOL-TF	6226-25-1	Intentional addition / 1%	chemical products
5747	2,7-Naphthalenedisulfonic acid, 3-hydroxy-4-[[4-(phenylazo)phenyl]azo]-, disodium salt	6226-78-4	Intentional addition / 100ppm	chemical products
5748	beta.-Cyano-L-alanine	6232-19-5	Intentional addition	chemical products
5749	1-Naphthalenesulfonic acid, 4-hydroxy-3-[[4-(phenylazo)phenyl]azo]-, monosodium salt	6245-62-1	Intentional addition / 100ppm	chemical products
5750	Phenol, 4-[[4-(phenylazo)phenyl]azo]-	6250-23-3	Intentional addition / 100ppm	chemical products
5751	Trisodium [N,N-bis(2-bis(carboxymethyl)amino)ethyl]glycinate(5-)]cobaltate(3-)	6255-07-8	Intentional addition / 1,000ppm	chemical products
5752	2-Anthracenesulfonic acid, 1-amino-4-bromo-9,10-dihydro-9,10-dioxo-, monosodium salt	6258-08-6	Contains (regardless of intentional or impurities)	chemical products
5753	Octane, 1,2-dibromo-	6269-82-7	Intentional addition / 1,000ppm	chemical products
5754	5-Chlorovaleronitrile	6280-87-1	Intentional addition	chemical products
5755	Nickel(II) fumarate	6283-67-6	Contains (regardless of intentional or impurities)	chemical products
5756	Succinic acid-nickel (1:1)	6283-68-7	Contains (regardless of intentional or impurities)	chemical products
5757	Hexane, 1-bromo-6-chloro-	6284-17-3	Intentional addition / 1,000ppm	chemical products
5758	Cyclohexane, 1-bromo-2-methyl-	6284-39-9	Intentional addition / 1,000ppm	chemical products
5759	Cyclohexane, 1-bromo-4-methyl-	6284-40-2	Intentional addition / 1,000ppm	chemical products
5760	Pyrocatechol, cyclic ester with antimonic acid (H3SbO3)	6285-12-1	Intentional addition / 1,000ppm	chemical products
5761	3-Chlorophthalide	6295-21-2	Contains (regardless of intentional or impurities)	chemical products
5762	4-Nitro-1H-benzotriazole	6298-39-4	Contains (regardless of intentional or impurities)	chemical products
5763	Phenol, 2-methyl-4-[[4-(phenylazo)phenyl]azo]-	6300-37-4	Intentional addition / 100ppm	chemical products
5764	1-Naphthalenesulfonic acid, 4-hydroxy-3-[[2-methyl-4-[[2-methylphenyl]azo]phenyl]azo]-, monosodium salt	6300-53-4	Intentional addition / 100ppm	chemical products
5765	Triphenylacetonitrile	6304-33-2	Intentional addition	chemical products
5766	(2,4-Dichlorophenyl)acetone	6306-60-1	Contains (regardless of intentional or impurities)	chemical products
5767	Arsonous dichloride, (3-nitrophenyl)-	6306-96-3	Contains (regardless of intentional or impurities)	chemical products
5768	Vinylboronic acid dibutyl ester	6336-45-4	Intentional addition / 1%	chemical products
5769	C.I. Direct Red 39, disodium salt	6358-29-8	Intentional addition / 100ppm	chemical products
5770	Manganese, [3-hydroxy-4-[[4-methyl-3-sulfonyl]azo]-2-naphthalenecarboxylato(2-)-O2O3]-	6358-40-3	Contains (regardless of intentional or impurities)	chemical products
5771	Disodium 4-hydroxy-3-[(o-tolyl)azo]-5-[(p-tolyl)sulfonyl]aminonaphthalene-2,7-disulphonate	6358-43-6	Intentional addition / 100ppm	chemical products
5772	C.I. Solvent Red 80	6358-53-8	Contains (regardless of intentional or impurities)	chemical products
5773	2-Naphthalenesulfonic acid, 4-hydroxy-7-[[[[5-hydroxy-6-[[2-methylphenyl]azo]-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-3-[[4-sulfonyl]azo]-, trisodium salt	6358-79-8	Intentional addition / 100ppm	chemical products
5774	2,7-Naphthalenedisulfonic acid, 4-amino-5-hydroxy-3-[[4-[[4-hydroxy-2-[[2-methylphenyl]amino]phenyl]azo][1,1'-biphenyl]-4-yl]azo]-6-[[4-sulfonyl]azo]-, trisodium salt	6358-80-1	Contains (regardless of intentional or impurities)	chemical products
5775	Benzoic acid, 5-[[4-[[4-[[4-amino-7-sulfo-1-naphthalenyl]azo]-6-sulfo-1-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-2-hydroxy-, trisodium salt	6360-29-8	Contains (regardless of intentional or impurities)	chemical products
5776	C.I. Direct brown 154	6360-54-9	Contains (regardless of intentional or impurities)	chemical products
5777	Ammonium 2-sec-butyl-4,6-dinitrophenolate	6365-83-9	Contains (regardless of intentional or impurities)	chemical products
5778	C.I. Solvent Red 19	6368-72-5	Intentional addition / 100ppm	chemical products
5779	2,5-Toluenediamine sulfate	6369-59-1	Intentional addition / 10ppm	chemical products
5780	Acetic acid, (2,4,5-trichlorophenoxy)-, compound with N-methylmethanamine (1:1)	6369-97-7	Intentional addition / 1,000ppm	chemical products
5781	Chromate(2-), hydroxy[3-hydroxy-4-[[1-hydroxy-8-sulfo-2-naphthalenyl]azo]-1-naphthalenesulfonato(4-)]-, disodium	6370-08-7	Contains (regardless of intentional or impurities)	chemical products
5782	Acid Black 54	6370-09-8	Contains (regardless of intentional or impurities)	chemical products
5783	Chromate(1-), [4-[[8-(aminosulfonyl)-1-hydroxy-2-naphthalenyl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]hydroxy-, sodium	6370-12-3	Contains (regardless of intentional or impurities)	chemical products
5784	Chromate(3-), bis[5-chloro-2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonato(3-)]-, trisodium	6370-14-5	Contains (regardless of intentional or impurities)	chemical products
5785	Sodium hydroxy[2-hydroxy-3-[[2-hydroxy-1-naphthyl]azo]-5-nitrobenzenesulphonato(3-)]chromate(1-)	6370-15-6	Contains (regardless of intentional or impurities)	chemical products
5786	Benzoic acid, 2-[[2-hydroxy-1-naphthalenyl]azo]-, barium salt (2:1)	6372-81-2	Contains (regardless of intentional or impurities)	chemical products
5787	Acetamide, N-(3-amino-4-methoxyphenyl)-	6375-47-9	Contains (regardless of intentional or impurities)	chemical products
5788	[1,1'-Biphenyl]-2,2'-disulfonic acid, 4,4'-bis[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-, disodium salt	6375-55-9	Contains (regardless of intentional or impurities)	chemical products
5789	Octylammonium methanesulfonate	6379-37-9	Contains (regardless of intentional or impurities)	chemical products
5790	2,3,4-trichloro-1,5-dinitrobenzene	6379-46-0	Intentional addition / 1%	chemical products
5791	Arsonous diiodide, phenyl-	6380-34-3	Contains (regardless of intentional or impurities)	chemical products
5792	tert-Butyl perchlorate	6380-69-4	Intentional addition / 1,000ppm	chemical products
5793	Diquat dibromide monohydrate	6385-62-2	Intentional addition / 1,000ppm	chemical products
5794	2,3-Epoxypropyl acetate	6387-89-9	Contains (regardless of intentional or impurities)	chemical products
5795	Allylcarb	6392-46-7	Intentional addition / 1%	chemical products
5796	3-Nitro-4-aminobenzonitrile	6393-40-4	Intentional addition	chemical products
5797	Cobalt dinoleate	6401-84-9	Intentional addition / 1,000ppm	chemical products
5798	Benzenesulfonic acid, 3,3'-[[3,3'-dimethyl[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[2,4-diamino-5-methyl-, disodium salt	6405-94-3	Intentional addition / 100ppm	chemical products
5799	2-Naphthalenesulfonic acid, 5,5'-[[3,3'-dimethyl[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[6-amino-, disodium salt	6406-01-5	Intentional addition / 100ppm	chemical products
5800	beta.-Chloro-N-(2-chloroethyl)-N-methylphenethylamine monohydrochloride	6407-19-8	Intentional addition / 1%	chemical products
5801	C.I. Acid Violet 58	6407-99-4	Intentional addition / 1,000ppm	chemical products
5802	Chromate(3-), bis[5-[[5-chloro-2-hydroxyphenyl]azo]-6-hydroxy-2-naphthalenesulfonato(3-)]-, disodium hydrogen	6408-02-2	Contains (regardless of intentional or impurities)	chemical products
5803	Disodium hydrogen bis[4-[[2,6-dihydroxy-3-[[2-hydroxy-3,5-dinitrophenyl]azo]phenyl]azo]-3-methylbenzenesulfonato(3-)]chromate(3-)	6408-05-5	Contains (regardless of intentional or impurities)	chemical products
5804	C.I. Acid Black 82	6408-06-6	Contains (regardless of intentional or impurities)	chemical products
5805	Acid Black 51	6408-19-1	Contains (regardless of intentional or impurities)	chemical products
5806	Cuprate(2-), [4-(hydroxy-kappa O)-3-[[2-(hydroxy-kappa O)-5-sulfonyl]azo-kappa N1]-7-(phenylamino)-2-naphthalenesulfonato(4-)]-, disodium	6408-20-4	Intentional addition / 1,000ppm	chemical products
5807	Cuprate(1-), [3-[[2-[[5-(aminosulfonyl)-2-(hydroxy-kappa O)phenyl]diazenyl-kappa N1]-4-(hydroxy-kappa O)-7-(phenylamino)-2-naphthalenesulfonato(3-)]-, sodium (1:1)	6408-21-5	Intentional addition / 1,000ppm	chemical products
5808	Chromate(7-), bis[4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfonyl]azo]-6-[[sulfomethyl]amino]-2-naphthalenesulfonato(5-)]-, hexasodium hydrogen	6408-22-6	Contains (regardless of intentional or impurities)	chemical products
5809	Chromate(3-), bis[5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(3-)]-, disodium hydrogen	6408-26-0	Contains (regardless of intentional or impurities)	chemical products
5810	Disodium hydrogen bis[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxyphenyl]amino-1-sulphonato(3-)]chromate(3-)	6408-29-3	Contains (regardless of intentional or impurities)	chemical products
5811	Chromate(2-), [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulfonyl)phenyl-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(4-)]hydroxy-, disodium	6408-31-7	Contains (regardless of intentional or impurities)	chemical products
5812	C.I. Acid Orange 61	6408-33-9	Intentional addition / 1,000ppm	chemical products
5813	Chromate(1-), [5-chloro-2-hydroxy-3-[[1,2,3,4-tetrahydro-2,4-dioxo-3-quinolinyl]azo]benzenesulfonato(3-)]hydroxy-, sodium	6408-34-0	Contains (regardless of intentional or impurities)	chemical products
5814	Strychnine hydrobromide monohydrate	6418-01-9	Contains (regardless of intentional or impurities)	chemical products
5815	Strychnine glucosate pentahydrate	6418-06-4	Contains (regardless of intentional or impurities)	chemical products
5816	Bis(2-hydroxyethyl)ammonium 2,4,5-trichlorophenoxyacetate	6417-43-2	Intentional addition / 1,000ppm	chemical products
5817	Nonanoic acid, copper(2+) salt	6418-65-1	Intentional addition / 1,000ppm	chemical products
5818	Trisodium 5-amino-4-hydroxy-3-[[4-[[1-hydroxy-4-sulphonato-2-naphthyl]azo]-3,3'-dimethyl[1,1'-biphenyl]-4-yl]azo]naphthalene-2,7-disulphonate	6420-09-3	Intentional addition / 100ppm	chemical products
5819	2,7-Naphthalenedisulfonic acid, 5-amino-3-[[4-[[6-amino-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3,3'-dimethyl[1,1'-biphenyl]-4-yl]azo]-4-hydroxy-, trisodium salt	6420-22-0	Intentional addition / 100ppm	chemical products
5820	2-Naphthalenesulfonic acid, 4-hydroxy-7-[[[[5-hydroxy-6-[[2-methylphenyl]azo]-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-3-[[2-methyl-4-sulfonyl]azo]-, trisodium salt	6420-43-5	Intentional addition / 100ppm	chemical products
5821	2-Naphthalenesulfonic acid, 4-hydroxy-7-[[[[5-hydroxy-6-[[2-methoxyphenyl]azo]-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-3-[[2-methyl-4-sulfonyl]azo]-, trisodium salt	6420-44-6	Intentional addition / 100ppm	chemical products
5822	Phenol, 2-(1-methylpropyl)-4,6-dinitro-, compound with 2,2',2'-nitrotris[ethanol] (1:1)	6420-47-9	Contains (regardless of intentional or impurities)	chemical products
5823	Cobaltate(1-), bis[2-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthalenolato(2-)]-, hydrogen	6421-64-3	Intentional addition / 1,000ppm	chemical products
5824	Propylene glycol dinitrate	6423-43-4	Intentional addition / 1%	chemical products
5825	Calcium methanarsonic acid	6423-72-9	Intentional addition / 1%	chemical products
5826	Cobalt(2+) 2-hydroxy-1,2,3-propanetricarboxylate hydrate (3:2:2)	6424-15-3	Intentional addition / 1%	chemical products
5827	Strychnine dichromate	6424-33-5	Contains (regardless of intentional or impurities)	chemical products
5828	C.I. Direct Violet 22, trisodium salt	6426-67-1	Contains (regardless of intentional or impurities)	chemical products
5829	Hexadecanoic acid, cadmium salt	6427-86-7	Contains (regardless of intentional or impurities)	chemical products
5830	Octanoic acid, chromium(2+) salt	6427-90-3	Contains (regardless of intentional or impurities)	chemical products
5831	2,7-Naphthalenedisulfonic acid, 4-amino-3,6-bis[[4-[[1-hydroxy-4-sulfo-2-naphthalenyl]azo]phenyl]azo]-5-hydroxy-, disodium salt	6428-31-5	Contains (regardless of intentional or impurities)	chemical products
5832	2,7-Naphthalenedisulfonic acid, 3-hydroxy-4-[[4-[[1-hydroxy-4-sulfo-2-naphthalenyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-, trisodium salt	6428-98-4	Intentional addition / 100ppm	chemical products
5833	2,4,4-Tribromobiphenyl	6430-90-6	Intentional addition / 1,000ppm	chemical products
5834	2,7-Naphthalenedisulfonic acid, 5-(acetyl)amino-4-hydroxy-3-[[2-methylphenyl]azo]-, disodium salt	6441-93-6	Intentional addition / 100ppm	chemical products
5835	3-(3,4-Dimethoxyphenyl)acrylonitrile	6443-72-7	Intentional addition	chemical products
5836	3-Pyridineacetonitrile	6443-85-2	Intentional addition	chemical products
5837	2-Naphthalenesulfonic acid, 6-amino-5-[[4-[[2-amino-7-sulfo-1-naphthalenyl]azo]-3,3'-dimethyl[1,1'-biphenyl]-4-yl]azo]-, disodium salt	6448-80-2	Intentional addition / 100ppm	chemical products
5838	2-Naphthalenecarboxamide, 3-hydroxy-4-[[2-methyl-5-nitrophenyl]azo]-N-phenyl-	6448-95-9	Contains (regardless of intentional or impurities)	chemical products
5839	2-Chromum tricarbonate	6449-80-9	Contains (regardless of intentional or impurities)	chemical products
5840	C.I. Direct Blue 151, disodium salt	6449-35-0	Intentional addition	chemical products
5841	Stannane dibutylphenyl-	6452-61-5	Contains (regardless of intentional or impurities)	chemical products
5842	Cuprate(1-), [3-(hydroxy-kappa O)-4-[[1-(hydroxy-kappa O)-2-naphthalenyl]azo-kappa N1]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium	6459-63-8	Intentional addition / 1,000ppm	chemical products
5843	C.I. Acid Red 114	6459-94-5	Contains (regardless of intentional or impurities)	chemical products
5844	Benzoic acid, 3,3'-[[3,3'-dimethyl[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[6-hydroxy-5-methyl-, disodium salt	6459-97-8	Intentional addition / 100ppm	chemical products
5845	Cobaltate(3-), bis[5-chloro-2-(hydroxy-kappa O)-3-[[2-(oxo-kappa O)-1-[[phenylamino]carbonyl]propyl]azo-kappa N1]benzenesulfonato(3-)]-, disodium hydrogen	6460-02-2	Intentional addition / 1%	chemical products
5846	Calvinphos	6465-92-5	Intentional addition	chemical products
5847	1-Naphthalenesulfonic acid, 4-amino-3-[[4-[[1-hydroxy-4-sulfo-2-naphthalenyl]azo]-3,3'-dimethyl[1,1'-biphenyl]-4-yl]azo]-, disodium salt	6470-45-7	Intentional addition / 100ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
5848	C.I. Pigment Red 23	6471-49-4	Contains (regardless of intentional or impurities)	chemical products
5849	C.I. Direct Yellow 1	6472-91-9	Intentional addition / 100ppm	chemical products
5850	C.I. Direct Violet 4	6472-95-3	Intentional addition / 100ppm	chemical products
5851	Trisodium 4-hydroxy-3-[[4'-[[1-hydroxy-4-sulphonato-2-naphthyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]naphthalene-2,7-disulphonate	6473-33-2	Intentional addition / 100ppm	chemical products
5852	C.I. Direct Brown 79	6483-77-8	Intentional addition / 100ppm	chemical products
5853	Ammonium nitrate	6484-52-2	Contains (regardless of intentional or impurities)	chemical products
5854	Manganese, bis(D-gluconato-O1,O2)-, (T-4)-	6485-39-8	Contains (regardless of intentional or impurities)	chemical products
5855	Methylselenol	6486-05-1	Intentional addition / 1,000ppm	chemical products
5856	C.I. Direct Yellow 24	6486-29-9	Intentional addition / 100ppm	chemical products
5857	Ethanedioic acid, dipotassium salt, monohydrate	6487-48-5	Intentional addition / 1,000ppm	chemical products
5858	Styrylamine acetate	6487-51-0	Contains (regardless of intentional or impurities)	chemical products
5859	Nicotine sulfate	6505-86-8	Contains (regardless of intentional or impurities)	chemical products
5860	Acid Blue C.I.14980	6505-91-5	Contains (regardless of intentional or impurities)	chemical products
5861	2-(Naphthalenedisulfonic acid, 4-hydroxy-3-[[2-methoxyphenyl]azo]-5-[[4-methylphenyl]sulfonyl]amino)-, disodium salt	6505-96-0	Intentional addition / 100ppm	chemical products
5862	Barium diethyl bis(sulphate)	6509-22-4	Contains (regardless of intentional or impurities)	chemical products
5863	Nicotine hydrochloride hydriodide iodine	6509-46-2	Contains (regardless of intentional or impurities)	chemical products
5864	Basic copper acetate	6533-47-7	Intentional addition / 1,000ppm	chemical products
5865	Strychnidin-10-one, mono(dimethylarsinate)	6533-70-6	Contains (regardless of intentional or impurities)	chemical products
5866	Thalious carbonate	6533-73-9	Contains (regardless of intentional or impurities)	chemical products
5867	Antimony(3+) potassium [R-(R*,R*)]-monotartrate	6535-15-5	Contains (regardless of intentional or impurities)	chemical products
5868	Octanoic acid, manganese salt	6535-19-9	Contains (regardless of intentional or impurities)	chemical products
5869	Octanoic acid, iron salt	6535-20-2	Intentional addition / 1%	chemical products
5870	Stibamine	6543-62-0	Contains (regardless of intentional or impurities)	chemical products
5871	Dihydrogen (ethyl)4-[[4-[[ethy(3-sulphonatobenzyl)amino]phenyl]2-sulphonatophenyl]methyl]cyclohexa-2,5-dien-1-ylidene]3-sulphonatobenzenyl]ammonium, barium salt	6548-12-5	Contains (regardless of intentional or impurities)	chemical products
5872	2,7-Naphthalenedisulfonic acid, 4,4'-[[3,3'-dichloro[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[3-amino-, tetrasodium salt	6548-29-4	Intentional addition / 100ppm	chemical products
5873	1,3-Naphthalenedisulfonic acid, 8-[[3,3'-dimethoxy-4'-[[4-[[4-methylphenyl]sulfonyl]oxy]phenyl]azo][1,1'-biphenyl]-4-yl]azo]-7-hydroxy-, disodium salt	6548-30-7	Intentional addition / 100ppm	chemical products
5874	Nicotine, compound with 2,4-dinitro-1-naphthol (1:1)	6549-06-0	Contains (regardless of intentional or impurities)	chemical products
5875	Nicotine, tartrate (1:1)	6550-19-2	Contains (regardless of intentional or impurities)	chemical products
5876	Manganese oxalate, dihydrate	6556-16-7	Contains (regardless of intentional or impurities)	chemical products
5877	Boranediamine, 1-chloro-N,N,N'-tetramethyl-	6562-41-0	Intentional addition / 1%	chemical products
5878	Borazine	6569-51-3	Intentional addition / 1%	chemical products
5879	Pentane, 1-bromo-3,4-dimethyl-	6570-92-9	Intentional addition / 1,000ppm	chemical products
5880	Hexane, 2-bromo-5-methyl-	6570-93-0	Intentional addition / 1,000ppm	chemical products
5881	Pentane, 1-bromo-4,4-dimethyl-	6570-95-2	Intentional addition / 1,000ppm	chemical products
5882	Benzonitrile, 2,3-dichloro-	6574-97-6	Contains (regardless of intentional or impurities)	chemical products
5883	2,4-Dichlorobenzonitrile	6574-98-7	Intentional addition	chemical products
5884	3,4-Dichlorobenzonitrile	6574-99-8	Intentional addition	chemical products
5885	3,5-Dichlorobenzonitrile	6575-00-4	Intentional addition	chemical products
5886	6-Chloro-2-nitrobenzonitrile	6575-07-1	Intentional addition	chemical products
5887	3-Chloro-2-toluenitrile	6575-09-3	Intentional addition	chemical products
5888	2-Chloro-6-methoxybenzonitrile	6575-10-6	Intentional addition	chemical products
5889	2-Amino-6-chlorobenzonitrile	6575-11-7	Intentional addition	chemical products
5890	1H-Indol-3-ol, 5-bromo-4-chloro-, dihydrogen phosphate (ester), compound with 4-methylbenzamine (1:1)	6578-06-9	Intentional addition	chemical products
5891	Methaneironic acid, iron(3+) salt	6585-53-1	Contains (regardless of intentional or impurities)	chemical products
5892	Ethanedioic acid, bismuth(3+) salt (3:2)	6591-55-5	Intentional addition / 1,000ppm	chemical products
5893	Nicotine, monohydrate, compound with iodine (1:1)	6591-68-0	Contains (regardless of intentional or impurities)	chemical products
5894	Disodium 4-amino-3-[[4'-[[2-amino-6-sulphonatophenyl]azo]-3,3'-dimethyl[1,1'-biphenyl]-4-yl]azo]naphthalene-1-sulphonate	6598-56-7	Intentional addition / 100ppm	chemical products
5895	2-Chloronitrobenzotrile	6602-54-6	Intentional addition	chemical products
5896	2-Methoxybenzonitrile	6609-56-9	Intentional addition	chemical products
5897	Benzonitrile, 2-ethoxy-	6609-57-0	Intentional addition	chemical products
5898	Plumbane, tripropyl-	6618-03-7	Contains (regardless of intentional or impurities)	chemical products
5899	Hexanenitrile, 6-bromo-	6621-59-6	Contains (regardless of intentional or impurities)	chemical products
5900	C.I. Acid Violet 12, disodium salt	6625-46-3	Intentional addition / 100ppm	chemical products
5901	Ethyl cyanoacetyl carbamate	6629-04-5	Intentional addition	chemical products
5902	Sodium p-arsenobenzenesulphonate	6634-88-4	Contains (regardless of intentional or impurities)	chemical products
5903	C.I. Direct Orange 6, disodium salt	6637-88-3	Intentional addition / 1,000ppm	chemical products
5904	2,3,5,6-Tetrahydro-6-phenylimidazo[2,1-b]thiazole	6649-23-6	Intentional addition / 1%	chemical products
5905	Aluminum, tridocosyl-	6651-25-8	Intentional addition / 1,000ppm	chemical products
5906	Aluminum, tritetracosyl-	6651-26-9	Intentional addition / 1,000ppm	chemical products
5907	Aluminum, trioctacosyl-	6651-27-0	Intentional addition / 1,000ppm	chemical products
5908	Chromate(1-), bis[3-[[1-[[3-(aminosulfonyl)phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)-], hydrogen	6656-00-4	Contains (regardless of intentional or impurities)	chemical products
5909	C.I. Acid Red 198	6656-01-5	Contains (regardless of intentional or impurities)	chemical products
5910	Chromate(1-), hydroxy[4-hydroxy-3-nitro-5-[[1,2,3,4-tetrahydro-2,4-dioxo-3-quinolino]azo]benzenesulfonato(3-)-], sodium	6656-02-6	Contains (regardless of intentional or impurities)	chemical products
5911	Cuprate(3-), [mu-[[7-[[3,3'-dihydroxy-4'-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-8-hydroxy-1,6-naphthalenedisulfonato(7-)]di-, trisodium	6656-03-7	Intentional addition / 1,000ppm	chemical products
5912	Cuprate(2-), [mu-[[7,7'-(carbonyldiimino)bis[3-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-2-naphthalenesulfonato(6-)]di-, disodium	6661-33-2	Intentional addition / 1,000ppm	chemical products
5913	Tetraethylammonium tetrachloro-cobaltate(II)	6667-75-0	Intentional addition / 1%	chemical products
5914	3,4,4-Tribromophenyl	6683-35-8	Intentional addition / 1,000ppm	chemical products
5915	N-(3-Anilino-2-chloro-2-propenyldiene)aniline hydrochloride	6684-16-8	Intentional addition / 1%	chemical products
5916	3,3-Dibutyl-2,4,3-benzodioxastannepin-1,5-dione	6688-50-2	Contains (regardless of intentional or impurities)	chemical products
5917	1-(4-Nitrophenoxy)-2-propanone	6698-72-2	Intentional addition / 1%	chemical products
5918	Octanoic acid, cobalt salt	6700-85-2	Intentional addition / 1,000ppm	chemical products
5919	Chromate(5-), bis[8-[[5-[[diethylamino]sulfonyl]-2-hydroxyphenyl]azo]-7-hydroxy-1,3-naphthalenedisulfonato(4-)-], tetrasodium hydrogen	6717-29-9	Contains (regardless of intentional or impurities)	chemical products
5920	Cuprate(3-), [3-[[5-(hydroxy-kappa O)-6-[[2-(hydroxy-kappa O)-4-[[4-[[2-[[4-methoxyphenyl]azo]-2-sulfonyl]ethenyl]-3-sulfonyl]azo]-6-sulfo-1-naphthalenyl]azo-kappa N]1]-7-sulfo-2-naphthalenyl]amino]benzoato(7-)]-, pentasodium	6717-36-8	Intentional addition / 1,000ppm	chemical products
5921	2-Amino-2-cyanoacetamide	6719-21-7	Intentional addition	chemical products
5922	2,4-Dibiphenyl)-2-sodium chloroacetate	6725-49-1	Intentional addition / 1%	chemical products
5923	1,1-Di(t-butylperoxy)-3,3,5-trimethylcyclohexane	6731-26-8	Contains (regardless of intentional or impurities)	chemical products
5924	C.I. Direct Black 91, trisodium salt	6739-82-4	Intentional addition / 1,000ppm	chemical products
5925	Ethanol, 1-[[5.alpha.,17.beta.)-17-(acetyloxy)-3-[[difluoroboryloxy]androst-2-en-2-yl]-	6742-94-5	Intentional addition / 1%	chemical products
5926	Androst-3-one, 17-(acetyloxy)-2-[[1-[[difluoroboryloxy]ethyldiene]-, (5.alpha.,17.beta.)-	6742-95-6	Intentional addition / 1%	chemical products
5927	2,3-Epoxypropyl p-toluenesulfonate	6746-81-2	Intentional addition / 1%	chemical products
5928	1,3-Naphthalenedisulfonic acid, 4-amino-5-hydroxy-6-[[4'-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-, trisodium salt	6771-80-8	Intentional addition / 100ppm	chemical products
5929	Trisodium bis[5-chloro-2-hydroxy-3-[[2-hydroxy-1-naphthyl]azo]benzenesulfonato(3-)]cobaltate(3-)	6771-86-4	Intentional addition / 1,000ppm	chemical products
5930	trans-2-Phenylvinylboronic acid	6783-05-7	Intentional addition / 1%	chemical products
5931	Cuprate(2-), [mu-[[7,7'-iminobis[3-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-2-naphthalenesulfonato(6-)]di-, disodium	6798-03-4	Intentional addition / 1,000ppm	chemical products
5932	Carbadox	6804-07-5	Contains (regardless of intentional or impurities)	chemical products
5933	1-Benzocyclobutene carbonitrile	6809-91-2	Intentional addition	chemical products
5934	Selenoethionine	6810-64-6	Intentional addition / 1,000ppm	chemical products
5935	Octanoic acid, manganese(2+) salt	6819-13-2	Contains (regardless of intentional or impurities)	chemical products
5936	Dibutylbis(dibutylthiocarbonylthio)stannane	6821-94-9	Contains (regardless of intentional or impurities)	chemical products
5937	Cuprate(3-), [mu-[[2-[[1-hydroxy-6-[[[5-hydroxy-6-[[2-hydroxy-5-sulfonyl]azo]-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-3-sulfo-2-naphthalenyl]azo]benzoato(7-)]di-, trisodium	6837-87-2	Intentional addition / 1,000ppm	chemical products
5938	DL-alpha-Hydroxy(p-hydroxyphenyl)acetone	6851-36-1	Intentional addition	chemical products
5939	Dichlorobis(3-pyridyl)carboxamide-N1 cobalt	6856-47-9	Intentional addition / 1,000ppm	chemical products
5940	Barium distearate	6865-35-6	Intentional addition / 1,000ppm	chemical products
5941	Boron, [1,1'-oxybis[ethane]]tris(pentafluorophenyl)-, (T-4)-	6867-36-3	Intentional addition / 1%	chemical products
5942	Hydrazobisisobutyronitrile	6869-07-4	Intentional addition	chemical products
5943	(9Z,12Z)-Octadeca-9,12-dienoic acid, manganese salt	6904-78-5	Contains (regardless of intentional or impurities)	chemical products
5944	(Z)-1,2-Dichloro-1-propene	6923-20-2	Intentional addition / 1,000ppm	chemical products
5945	Monocrotophos	6923-22-4	Contains (regardless of intentional or impurities)	chemical products
5946	Acetic acid, antimony(3+) salt (3:1)	6923-52-0	Contains (regardless of intentional or impurities)	chemical products
5947	Diacyoxydiphenylplumbane	6928-68-3	Contains (regardless of intentional or impurities)	chemical products
5948	1,6,3,8,2,7-Dioxadithiadistannecane-5,10-dione, 2,2,7,7-tetrabutyl-	6931-76-6	Contains (regardless of intentional or impurities)	chemical products
5949	Stibine, tris(dodecylthio)-	6939-83-9	Contains (regardless of intentional or impurities)	chemical products
5950	Butane, 1-bromo-4-chloro-	6940-78-9	Intentional addition / 1,000ppm	chemical products
5951	3-Bromobenzonitrile	6952-59-6	Intentional addition	chemical products
5952	4-(4-Aminophenylazo)phenylarsonic acid	6966-64-9	Contains (regardless of intentional or impurities)	chemical products
5953	1-Cyclohexene-1-acetonitrile	6975-71-9	Intentional addition	chemical products
5954	Sodium 4-aminobenzenethiol	6976-04-1	Intentional addition / 1%	chemical products
5955	Dioxcarb	6988-21-2	Contains (regardless of intentional or impurities)	chemical products
5956	Tin distearate, pure	6994-59-8	Contains (regardless of intentional or impurities)	chemical products
5957	Selenobenzoic acid	6996-92-5	Contains (regardless of intentional or impurities)	chemical products
5958	3-Chloro-N-methylaniline	7006-52-2	Intentional addition / 1%	chemical products
5959	Ethanamine, N,N-dimethyl-2-[[4-methyl-1,3,2-dioxaborinan-2-yl]oxy]-	7024-33-1	Intentional addition / 1%	chemical products
5960	(2-Methoxyphenyl)acetone	7035-03-2	Contains (regardless of intentional or impurities)	chemical products
5961	Ethanedioic acid, cerium salt	7047-09-6	Intentional addition / 1,000ppm	chemical products
5962	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, ammonium iron salt	7050-19-3	Intentional addition / 1%	chemical products
5963	Ethanedioic acid, copper salt	7057-72-9	Intentional addition / 1,000ppm	chemical products
5964	Benzoic acid, 2-amino-, cadmium salt (1:1)	7058-55-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
5965	Barium 5'-thymidylate	7060-14-2	Contains (regardless of intentional or impurities)	chemical products
5966	Stibine, oxybis(diphenyl)-	7065-22-7	Contains (regardless of intentional or impurities)	chemical products
5967	Stannane, butyltricyclohexyl-	7067-44-9	Contains (regardless of intentional or impurities)	chemical products
5968	(E)-1,2-Dichloro-1-propene	7069-38-7	Intentional addition / 1,000ppm	chemical products
5969	o-Bromocumene	7073-94-1	Intentional addition / 1,000ppm	chemical products
5970	Mecoprop	7085-19-0	Contains (regardless of intentional or impurities)	chemical products
5971	Ethyl cyanoacrylate	7085-85-0	Contains (regardless of intentional or impurities)	chemical products
5972	2,4,8,10-Tetraoxa-3,9-diboraspino[5.5]undecane, 3,9-bis(4-methylphenyl)-	7091-41-0	Intentional addition / 1%	chemical products
5973	Iron lactate	7100-07-7	Intentional addition / 1%	chemical products
5974	Dimethyl diselenide	7101-31-7	Contains (regardless of intentional or impurities)	chemical products
5975	1,1,1-Trichloro-3,3,3-trifluoropropane	7125-83-9	Intentional addition / 1,000ppm	chemical products
5976	HOFC-233	7125-84-0	Intentional addition / 1,000ppm	chemical products
5977	Propane, 3,3-dibromo-1,1,1-trifluoro-	7125-94-2	Intentional addition / 1,000ppm	chemical products
5978	1,1-Dichloro-1,2,2-trifluoropropane	7125-99-7	Intentional addition / 1,000ppm	chemical products
5979	2,2-Dichloro-1,1,1-trifluoropropane	7126-01-4	Intentional addition / 1,000ppm	chemical products
5980	1,2-Dichloro-1,1-difluoropropane	7126-15-0	Intentional addition / 1,000ppm	chemical products
5981	1,2,3-Trichloro-2-fluoropropane	7126-16-1	Intentional addition	chemical products
5982	Tris[(tributylstannyl)oxy]borane	7141-19-7	Contains (regardless of intentional or impurities)	chemical products
5983	Benzenesulfonic acid, 4-methyl-, copper(2+) salt	7144-37-8	Intentional addition / 1,000ppm	chemical products
5984	5-(4-Nitrophenyl)-2-furaldehyde	7147-77-5	Contains (regardless of intentional or impurities)	chemical products
5985	1-Propanol, 3-chloro-, borate	7150-61-0	Intentional addition / 1%	chemical products
5986	5-Amino-4-cyano-1-phenyl-1H-pyrazole-3-acetonitrile	7152-40-1	Intentional addition	chemical products
5987	Ethyl 4-cyanobenzoate	7153-22-2	Intentional addition	chemical products
5988	Pentane, 2,2,3,3-tetramethyl-	7154-79-2	Intentional addition / 1,000ppm	chemical products
5989	Ethanedioic acid, thulium salt (3:2), hexahydrate	7163-61-3	Intentional addition	chemical products
5990	Didecyl-dimethylammonium chloride	7173-51-5	Contains (regardless of intentional or impurities)	chemical products
5991	3-(2-Furyl)-acrylonitrile	7187-01-1	Intentional addition	chemical products
5992	Boroxin, 2,4,6-triphenoxy-	7187-84-0	Intentional addition / 1%	chemical products
5993	Bis(2,3-epoxypropyl) terephthalate	7195-44-0	Contains (regardless of intentional or impurities)	chemical products
5994	1-[(Chloromethylthio)-4-nitrobenzene	7205-88-1	Intentional addition / 1%	chemical products
5995	Benzoic acid, 5-[[4-[[[4-[[[3-carboxy-4-hydroxyphenyl]azo]phenyl]amino]-6-(phenylamino)-1,3,5-triazin-2-yl]amino]-1-hydroxy-3,6-disulfo-2-naphthalenyl]azo]-5-methoxy-2-methylphenyl]azo]-2-hydroxy-3-sulfo-, pentasodium salt	7219-11-6	Intentional addition / 1,000ppm	chemical products
5996	Stannane, triphenylthiocyanato-	7224-23-9	Contains (regardless of intentional or impurities)	chemical products
5997	Benzoic acid, 2-[[[(triphenylstannyl)oxy]carbonyl]-	7224-27-3	Intentional addition / 1,000ppm	chemical products
5998	Benzoic acid, o-chloro-, nickel(2+) salt	7250-60-4	Contains (regardless of intentional or impurities)	chemical products
5999	Dantrolene	7261-97-4	Contains (regardless of intentional or impurities)	chemical products
6000	Copper, [propanedioato(2-)-O,O']-	7268-92-0	Intentional addition / 1,000ppm	chemical products
6001	Tris(1-dodecyl-3-methyl-2-phenylbenzimidazolium)hexacyanoferrate	7276-58-6	Contains (regardless of intentional or impurities)	chemical products
6002	Benzenamine, N-butyl-2-methyl-	7277-86-3	Intentional addition / 25%	chemical products
6003	Benzenemethanaminium, N-dodecyl-N,N-dimethyl-, bromide	7281-04-1	Intentional addition / 1,000ppm	chemical products
6004	Prometryn	7287-19-6	Intentional addition / 1,000ppm	chemical products
6005	Propaphos	7292-16-2	Intentional addition / 1%	chemical products
6006	Trimesitylborane	7297-95-2	Intentional addition / 1%	chemical products
6007	1H-1,4-Diazepine, 2,3-dihydro-5,7-dimethyl-, monoperchlorate	7300-56-3	Intentional addition / 1,000ppm	chemical products
6008	Stannane, fluorotris(2-methylpropyl)-	7304-48-5	Contains (regardless of intentional or impurities)	chemical products
6009	Ethane, 1,1,1-tribromo-2,2-difluoro-	7304-53-2	Intentional addition / 1,000ppm	chemical products
6010	3-Ethyl-2-[3-(3-ethyl-3H-benzoselenazo-2-ylidene)isobut-1-enyl]benzoseleazolium iodide	7310-87-4	Contains (regardless of intentional or impurities)	chemical products
6011	3-(o-Chlorophenyl)propane nitrile	7315-17-5	Intentional addition	chemical products
6012	Borane, dichloromethyl-	7318-78-7	Intentional addition / 1%	chemical products
6013	Boronic acid, ethyl-, dimethyl ester	7318-82-3	Intentional addition / 1%	chemical products
6014	Hexanoic acid, 2-ethyl-, iron(3+) salt	7321-53-1	Intentional addition / 1%	chemical products
6015	Benzoic acid, 2-ethyl-, iron(3+) salt	7324-74-5	Contains (regardless of intentional or impurities)	chemical products
6016	Dodecyl (Z,Z)-6,8-dibutyl-3,6,10-trioxo-1-phenyl-2,7,9-trioxa-8-stannatrideca-4,11-dien-13-oate	7324-77-8	Contains (regardless of intentional or impurities)	chemical products
6017	Acetonitrile, 2,2,2'-nitrotris-	7327-60-8	Intentional addition	chemical products
6018	Hexanoic acid, 2-ethyl-, chromium salt	7329-33-1	Intentional addition / 1,000ppm	chemical products
6019	Hydrazine, monoacetate	7335-85-1	Contains (regardless of intentional or impurities)	chemical products
6020	Boron, trihydro(2-methyl-2-propanamine)-, (T-4)-	7337-45-3	Intentional addition / 1%	chemical products
6021	Triisobutyltin chloride	7342-38-3	Contains (regardless of intentional or impurities)	chemical products
6022	Triisobutyltin bromide	7342-39-4	Contains (regardless of intentional or impurities)	chemical products
6023	Tri-n-propyltin iodide	7342-45-2	Contains (regardless of intentional or impurities)	chemical products
6024	Tributyltin iodide	7342-47-4	Contains (regardless of intentional or impurities)	chemical products
6025	2-Pentene, 1-bromo-, (E)-	7348-71-2	Intentional addition / 1,000ppm	chemical products
6026	2-Pentene, 1-bromo-, (Z)-	7348-78-9	Intentional addition / 1,000ppm	chemical products
6027	2-Cyanothioacetamide	7357-70-2	Intentional addition	chemical products
6028	Iron tributanolate	7360-47-6	Intentional addition / 1%	chemical products
6029	Formic acid, aluminum salt	7360-53-4	Intentional addition / 1,000ppm	chemical products
6030	3,3'-Diselenodipropionic acid	7370-58-3	Contains (regardless of intentional or impurities)	chemical products
6031	Benzene, 1,2-diisocyanato-3-methyl-	7373-19-5	Intentional addition / 1%	chemical products
6032	Tetralylstannane	7393-43-3	Contains (regardless of intentional or impurities)	chemical products
6033	Boric acid (H3BO3), tris(1,1-dimethylethyl) ester	7397-43-5	Intentional addition / 1%	chemical products
6034	Boronic acid, diethyl-, methyl ester	7397-46-8	Contains (regardless of intentional or impurities)	chemical products
6035	3,3'-Diaminobenzidine tetrahydrochloride	7411-49-6	Contains (regardless of intentional or impurities)	chemical products
6036	Tributylstannyl p-hydroxybenzoate	7414-81-5	Contains (regardless of intentional or impurities)	chemical products
6037	Ethanedioic acid, tin(4+) salt (2:1)	7423-27-0	Intentional addition / 1,000ppm	chemical products
6038	Aluminum	7429-90-5	Contains (regardless of intentional or impurities)	chemical products
6039	5,5,14,14-Tetrabutyl-7,12-dioxo-6,13-dioxo-5,14-distannaoctadecane	7437-35-6	Contains (regardless of intentional or impurities)	chemical products
6040	Benzenediazonium, 2,4-dimethoxy-, tetrafluoroborate(1-)	7438-18-8	Intentional addition / 1%	chemical products
6041	Manganese	7439-96-5	Contains (regardless of intentional or impurities)	chemical products
6042	Molybdenum	7439-98-7	Contains (regardless of intentional or impurities)	chemical products
6043	Nickel	7440-02-0	Contains (regardless of intentional or impurities)	chemical products
6044	Platinum	7440-06-4	Contains (regardless of intentional or impurities)	chemical products
6045	Plutonium	7440-07-5	Intentional addition / 1,000ppm	chemical products
6046	Potassium	7440-09-7	Contains (regardless of intentional or impurities)	chemical products
6047	Radium	7440-14-4	Intentional addition / 1,000ppm	chemical products
6048	Rhodium	7440-16-6	Contains (regardless of intentional or impurities)	chemical products
6049	Silver	7440-22-4	Contains (regardless of intentional or impurities)	chemical products
6050	Sodium	7440-23-5	Contains (regardless of intentional or impurities)	chemical products
6051	Tantalum	7440-25-7	Contains (regardless of intentional or impurities)	chemical products
6052	Thallium	7440-28-0	Contains (regardless of intentional or impurities)	chemical products
6053	Thorium	7440-29-1	Contains (regardless of intentional or impurities)	chemical products
6054	Tin	7440-31-5	Contains (regardless of intentional or impurities)	chemical products
6055	Tungsten	7440-33-7	Intentional addition / 1,000ppm	chemical products
6056	Antimony	7440-36-0	Contains (regardless of intentional or impurities)	chemical products
6057	Arsenic	7440-38-2	Contains (regardless of intentional or impurities)	chemical products
6058	Barium	7440-39-3	Contains (regardless of intentional or impurities)	chemical products
6059	Beryllium	7440-41-7	Contains (regardless of intentional or impurities)	chemical products
6060	Boron	7440-42-8	Intentional addition / 1%	chemical products
6061	Chromium	7440-47-3	Contains (regardless of intentional or impurities)	chemical products
6062	Cobalt	7440-48-4	Contains (regardless of intentional or impurities)	chemical products
6063	Copper	7440-50-8	Contains (regardless of intentional or impurities)	chemical products
6064	Hafnium	7440-58-6	Contains (regardless of intentional or impurities)	chemical products
6065	Uranium	7440-61-1	Contains (regardless of intentional or impurities)	chemical products
6066	Vanadium	7440-62-2	Contains (regardless of intentional or impurities)	chemical products
6067	Yttrium	7440-65-5	Contains (regardless of intentional or impurities)	chemical products
6068	Zirconium	7440-67-7	Contains (regardless of intentional or impurities)	chemical products
6069	Bismuth	7440-69-9	Intentional addition / 1,000ppm	chemical products
6070	Indium	7440-74-6	Intentional addition / 1%	chemical products
6071	Plumbane, trimethyl-	7442-13-9	Contains (regardless of intentional or impurities)	chemical products
6072	Boron, trifluoro[N-(phenylmethyl)benzenemethanamine]-, (T-4)-	7445-38-7	Contains (regardless of intentional or impurities)	chemical products
6073	Tellurium dioxide	7446-07-3	Contains (regardless of intentional or impurities)	chemical products
6074	Selenium dioxide	7446-08-4	Contains (regardless of intentional or impurities)	chemical products
6075	Sulfur dioxide	7446-09-5	Contains (regardless of intentional or impurities)	chemical products
6076	Selenic acid, dirubidium salt	7446-17-5	Contains (regardless of intentional or impurities)	chemical products
6077	Sulfuric acid, thallium(1+) salt (1:2)	7446-18-6	Contains (regardless of intentional or impurities)	chemical products
6078	Zinc sulfate, monohydrate	7446-19-7	Contains (regardless of intentional or impurities)	chemical products
6079	Zinc sulfate heptahydrate	7446-20-0	Intentional addition / 1,000ppm	chemical products
6080	Selenic acid, strontium salt (1:1)	7446-21-1	Contains (regardless of intentional or impurities)	chemical products
6081	Thallous selenate	7446-22-2	Contains (regardless of intentional or impurities)	chemical products
6082	Zinc pyrophosphate	7446-26-6	Intentional addition / 25%	chemical products
6083	diantimony tris(sulfate)	7446-32-4	Contains (regardless of intentional or impurities)	chemical products
6084	Selenium monosulfide	7446-34-6	Contains (regardless of intentional or impurities)	chemical products
6085	Aluminum chloride	7446-70-0	Contains (regardless of intentional or impurities)	chemical products
6086	2-Propenoic acid, sodium salt	7446-81-3	Intentional addition / 1%	chemical products
6087	Copper chloride (CuCl2)	7447-39-4	Contains (regardless of intentional or impurities)	chemical products
6088	Iron hydroxide succinate	7459-88-3	Intentional addition / 1%	chemical products
6089	o-Formylbenzotrile	7468-67-9	Intentional addition	chemical products
6090	7-Methyl-8-nitroquinoline	7471-63-8	Intentional addition / 1%	chemical products
6091	Propionic acid, 2-chloro-, (R)-(+)-	7474-05-7	Intentional addition / 1,000ppm	chemical products
6092	Copper, bis(O,O-bis(1-methylethyl) phosphorodithioato-S,S')-, (SP-4-1)-	7481-27-8	Intentional addition / 1,000ppm	chemical products
6093	Tributylvinylstannane	7486-35-3	Contains (regardless of intentional or impurities)	chemical products
6094	Sulfuric acid, tin(2+) salt (1:1)	7488-55-3	Contains (regardless of intentional or impurities)	chemical products
6095	Selenium sulfide (SeS2)	7488-56-4	Contains (regardless of intentional or impurities)	chemical products
6096	2,4-Hexadienoic acid, calcium salt, (E,E)-	7492-55-9	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
6097	Copper carbonates	7489-68-4	Intentional addition / 1,000ppm	chemical products
6098	Phosphorous acid, bis(2-ethylhexyl) ester, cadmium salt	7495-93-4	Contains (regardless of intentional or impurities)	chemical products
6099	2-Naphthylacetone	7498-57-9	Intentional addition	chemical products
6100	2-Pentene, 5-bromo-, (E)-	7515-62-0	Intentional addition / 1,000ppm	chemical products
6101	Barium malate	7530-87-2	Intentional addition / 1,000ppm	chemical products
6102	Dichlorodivinylstannane	7532-85-6	Contains (regardless of intentional or impurities)	chemical products
6103	Ethanol, 2-(dicyclohexylamino)-, triester with boric acid (H3BO3)	7539-58-4	Intentional addition / 1%	chemical products
6104	Carbonic acid, cobalt salt	7542-09-8	Intentional addition / 1,000ppm	chemical products
6105	Boric acid, B-(1Z)-1-propen-1-yl-	7547-86-8	Intentional addition / 1%	chemical products
6106	Boric acid, B-(1E)-1-propen-1-yl-	7547-87-9	Intentional addition / 1%	chemical products
6107	Triphenyltin nicotinate	7552-16-1	Contains (regardless of intentional or impurities)	chemical products
6108	Bis(triphenyltin) fumarate	7552-19-4	Intentional addition / 1,000ppm	chemical products
6109	Iodine	7553-56-2	Contains (regardless of intentional or impurities)	chemical products
6110	α-Tolidine hydrochloride	7563-59-9	Intentional addition / 30ppm	chemical products
6111	N-Ethylcarbazole-3-carbaldehyde	7570-45-8	Contains (regardless of intentional or impurities)	chemical products
6112	Dichloroacetylene	7572-29-4	Contains (regardless of intentional or impurities)	chemical products
6113	Antimony tri(octanoate)	7578-07-6	Contains (regardless of intentional or impurities)	chemical products
6114	Borates(1-), (acetato-O)trifluoro-, hydrogen, (T-4)-	7578-36-1	Contains (regardless of intentional or impurities)	chemical products
6115	2-Ethylhexanoic acid, nickel salt	7580-31-6	Contains (regardless of intentional or impurities)	chemical products
6116	Lithium hydride	7580-67-8	Contains (regardless of intentional or impurities)	chemical products
6117	Dibutyltin bis(3-chloropropionate)	7580-74-7	Contains (regardless of intentional or impurities)	chemical products
6118	Di-n-octyltin bis(3-chloropropionate)	7580-76-9	Intentional addition / 1,000ppm	chemical products
6119	2,3-Dichlorobutane	7581-97-7	Intentional addition / 1,000ppm	chemical products
6120	Acetic acid, zirconium salt	7585-20-8	Contains (regardless of intentional or impurities)	chemical products
6121	2-Naphthalenecarboxylic acid, 4-[(5-chloro-4-methyl-2-sulfophenylazo)-3-hydroxy- barium salt (1:1)	7585-41-3	Contains (regardless of intentional or impurities)	chemical products
6122	Sodium perchlorate	7601-89-0	Contains (regardless of intentional or impurities)	chemical products
6123	Perchloric acid	7601-90-3	Contains (regardless of intentional or impurities)	chemical products
6124	Phenylsulfonacetonitrile	7605-28-9	Intentional addition	chemical products
6125	Stearic acid, copper salt	7617-31-4	Intentional addition / 1,000ppm	chemical products
6126	Sodium 3-[[[3-carboxylatopropionamido]carbonylamino]-2-methoxypropyl]hydroxymercurate(-1)	7620-30-6	Contains (regardless of intentional or impurities)	chemical products
6127	1H-Benzimidazol-5-amine, 2-(4-aminophenyl)-	7621-86-5	Contains (regardless of intentional or impurities)	chemical products
6128	Silica, amorphous	7631-86-9	Contains (regardless of intentional or impurities)	chemical products
6129	Sodium arsenate	7631-89-2	Contains (regardless of intentional or impurities)	chemical products
6130	Sodium bisulfite	7631-90-5	Contains (regardless of intentional or impurities)	chemical products
6131	Sodium molybdate	7631-95-0	Contains (regardless of intentional or impurities)	chemical products
6132	Sodium nitrite	7632-00-0	Contains (regardless of intentional or impurities)	chemical products
6133	Vanadium tetrachloride	7632-51-1	Contains (regardless of intentional or impurities)	chemical products
6134	Strychnine, hexafluoroantimonate(1-):(1:1)	7636-75-1	Contains (regardless of intentional or impurities)	chemical products
6135	Boron trifluoride	7637-07-2	Contains (regardless of intentional or impurities)	chemical products
6136	Octadecanoic acid, tin salt	7637-13-0	Contains (regardless of intentional or impurities)	chemical products
6137	Stannane, tetrachloro-	7646-78-8	Contains (regardless of intentional or impurities)	chemical products
6138	Zinc chloride	7646-85-7	Contains (regardless of intentional or impurities)	chemical products
6139	Hydrochloric acid	7647-01-0	Contains (regardless of intentional or impurities)	chemical products
6140	Sodium bromide	7647-15-6	Intentional addition / 1,000ppm	chemical products
6141	Antimony pentachloride	7647-18-9	Contains (regardless of intentional or impurities)	chemical products
6142	Strychnine, 2,2-difluoro-5,5-dimethyl-4,4'-dinitro-3,3'-biphenyldicarboxylate (2:1)	7649-63-0	Contains (regardless of intentional or impurities)	chemical products
6143	Azirdine, 1,1'-(1,3-phenylenedicarbonyl)bis[2-methyl-	7652-64-4	Intentional addition / 1%	chemical products
6144	Tributyl(palmitoyloxy)stannane	7653-28-3	Contains (regardless of intentional or impurities)	chemical products
6145	3-Chloro-2-methylpropionitrile	7659-45-2	Intentional addition	chemical products
6146	2-Oxo-1-pyrrolidine propane nitrile	7663-76-5	Intentional addition	chemical products
6147	Phosphoric acid	7664-38-2	Contains (regardless of intentional or impurities)	chemical products
6148	Hydrofluoric acid	7664-39-3	Contains (regardless of intentional or impurities)	chemical products
6149	Ammonia	7664-41-7	Contains (regardless of intentional or impurities)	chemical products
6150	Sulfuric acid	7664-83-9	Contains (regardless of intentional or impurities)	chemical products
6151	Silane-carbonitrile, trimethyl-	7677-24-9	Contains (regardless of intentional or impurities)	chemical products
6152	Borane, dichloro(1-methylethyl)-	7680-99-1	Intentional addition / 1%	chemical products
6153	Potassium iodide (KI)	7681-11-0	Intentional addition / 1,000ppm	chemical products
6154	Sodium fluoride	7681-49-4	Contains (regardless of intentional or impurities)	chemical products
6155	Sodium metabisulfite	7681-57-4	Contains (regardless of intentional or impurities)	chemical products
6156	Copper iodide (CuI)	7681-65-4	Intentional addition / 1,000ppm	chemical products
6157	Sodium 4-(glycolylamino)phenylarsenate	7681-83-6	Contains (regardless of intentional or impurities)	chemical products
6158	Trimethoxyoxovanadium	7681-91-6	Intentional addition / 1%	chemical products
6159	4-Bromo-2-nitrophenol	7693-52-9	Contains (regardless of intentional or impurities)	chemical products
6160	Tetramethrin	7698-12-0	Intentional addition / 10ppm	chemical products
6161	N,N-Dimethyl-N'-(4-nitrosophenyl)-1,4-benzenediamine	7698-70-0	Intentional addition / 1%	chemical products
6162	Nitric acid	7697-37-2	Contains (regardless of intentional or impurities)	chemical products
6163	Zirconium oxychloride	7699-43-6	Contains (regardless of intentional or impurities)	chemical products
6164	Zinc bromide	7699-45-8	Intentional addition / 1%	chemical products
6165	Orotoxyphos	7700-17-6	Contains (regardless of intentional or impurities)	chemical products
6166	Zirconium hydride	7704-99-6	Contains (regardless of intentional or impurities)	chemical products
6167	Titanium trichloride	7705-07-9	Contains (regardless of intentional or impurities)	chemical products
6168	Iron chloride (FeCl3)	7705-08-0	Contains (regardless of intentional or impurities)	chemical products
6169	2-Butenedioic acid (E)-, iron(2+) salt	7705-12-6	Intentional addition / 1%	chemical products
6170	Nickel(II) chloride	7718-54-9	Contains (regardless of intentional or impurities)	chemical products
6171	Vanadium trichloride	7718-98-1	Contains (regardless of intentional or impurities)	chemical products
6172	Thionyl chloride	7719-09-7	Contains (regardless of intentional or impurities)	chemical products
6173	Phosphorous trichloride	7719-12-2	Contains (regardless of intentional or impurities)	chemical products
6174	Sulfuric acid, iron(2+) salt (1:1)	7720-78-7	Contains (regardless of intentional or impurities)	chemical products
6175	9,12-Octadecadienoic acid (Z,Z)-, copper salt	7721-15-5	Intentional addition / 1,000ppm	chemical products
6176	Potassium permanganate	7722-64-7	Contains (regardless of intentional or impurities)	chemical products
6177	Hydrogen peroxide	7722-84-1	Contains (regardless of intentional or impurities)	chemical products
6178	Tetrasodium pyrophosphate	7722-88-5	Intentional addition / 1%	chemical products
6179	Bromine	7726-95-6	Contains (regardless of intentional or impurities)	chemical products
6180	Vanadium oxytrichloride	7727-18-6	Contains (regardless of intentional or impurities)	chemical products
6181	Dipotassium peroxodisulphate	7727-21-1	Contains (regardless of intentional or impurities)	chemical products
6182	Barium sulfate	7727-43-7	Contains (regardless of intentional or impurities)	chemical products
6183	Ammonium persulfate	7727-54-0	Contains (regardless of intentional or impurities)	chemical products
6184	trans-4-Methylcyclohexanol	7731-29-5	Intentional addition / 1,000ppm	chemical products
6185	Zinc sulfate	7733-02-0	Contains (regardless of intentional or impurities)	chemical products
6186	1H,3H,5H-Oxazolol[3,4-c]oxazole, 7a-ethylidihydro-	7747-35-5	Contains (regardless of intentional or impurities)	chemical products
6187	Disulfurous acid, disodium salt	7757-74-6	Intentional addition / 1,000ppm	chemical products
6188	Sodium sulfite	7757-83-7	Intentional addition / 1,000ppm	chemical products
6189	Nickel(2+) sulphite	7757-95-1	Contains (regardless of intentional or impurities)	chemical products
6190	Potassium bromate	7758-01-2	Contains (regardless of intentional or impurities)	chemical products
6191	Potassium nitrite	7758-09-0	Contains (regardless of intentional or impurities)	chemical products
6192	Sodium chlorite	7758-19-2	Contains (regardless of intentional or impurities)	chemical products
6193	Copper chloride (CuCl)	7758-89-6	Contains (regardless of intentional or impurities)	chemical products
6194	Iron chloride (FeCl2)	7758-94-3	Intentional addition / 1%	chemical products
6195	Sulfuric acid, copper(2+) salt (1:1)	7758-98-7	Contains (regardless of intentional or impurities)	chemical products
6196	Sulfuric acid, copper(2+) salt (1:1), pentahydrate	7758-99-8	Contains (regardless of intentional or impurities)	chemical products
6197	Silicic acid (H2SiO3), manganese(2+) salt (1:1)	7758-00-4	Contains (regardless of intentional or impurities)	chemical products
6198	Silver nitrate	7761-88-8	Contains (regardless of intentional or impurities)	chemical products
6199	1-Undecene, 11-bromo-	7766-50-9	Intentional addition / 1,000ppm	chemical products
6200	Stannous chloride	7772-99-8	Contains (regardless of intentional or impurities)	chemical products
6201	Manganese(II) chloride	7773-01-5	Contains (regardless of intentional or impurities)	chemical products
6202	Sulfamic acid, ammonium salt (1:1)	7773-06-0	Contains (regardless of intentional or impurities)	chemical products
6203	9-Octadecenoic acid (Z)-, tin salt	7774-76-7	Contains (regardless of intentional or impurities)	chemical products
6204	Sodium chlorate	7775-09-9	Contains (regardless of intentional or impurities)	chemical products
6205	Sodium metaborate	7775-19-1	Intentional addition / 1%	chemical products
6206	Sodium persulfate	7775-27-1	Contains (regardless of intentional or impurities)	chemical products
6207	Silver fluoride (AgF)	7775-41-9	Contains (regardless of intentional or impurities)	chemical products
6208	Arsenic acid (H3AsO4), copper(2+) salt (2:3)	7778-41-8	Contains (regardless of intentional or impurities)	chemical products
6209	Disodium hydrogen arsenate	7778-43-0	Contains (regardless of intentional or impurities)	chemical products
6210	Calcium hypochlorite	7778-54-3	Contains (regardless of intentional or impurities)	chemical products
6211	Potassium perchlorate	7778-74-7	Contains (regardless of intentional or impurities)	chemical products
6212	Iron (9Z,12Z)-octadeca-9,12-dienoate	7779-63-7	Intentional addition / 1%	chemical products
6213	Zinc hydrosulfite	7779-86-4	Contains (regardless of intentional or impurities)	chemical products
6214	Zinc nitrate	7779-88-6	Contains (regardless of intentional or impurities)	chemical products
6215	Phosphoric acid, zinc salt (2:3)	7779-90-0	Contains (regardless of intentional or impurities)	chemical products
6216	Fluorine	7782-41-4	Contains (regardless of intentional or impurities)	chemical products
6217	Selenium	7782-49-2	Contains (regardless of intentional or impurities)	chemical products
6218	Chlorine	7782-50-5	Contains (regardless of intentional or impurities)	chemical products
6219	Ferric nitrate nonahydrate	7782-61-8	Intentional addition / 1%	chemical products
6220	Ferrous sulfate heptahydrate	7782-63-0	Contains (regardless of intentional or impurities)	chemical products
6221	Manganese fluoride (MnF2)	7782-64-1	Contains (regardless of intentional or impurities)	chemical products
6222	Germanium tetrahydride	7782-65-2	Contains (regardless of intentional or impurities)	chemical products
6223	Nitrous acid	7782-77-6	Contains (regardless of intentional or impurities)	chemical products
6224	Sodium hydrogen selenite	7782-82-3	Contains (regardless of intentional or impurities)	chemical products
6225	Molybdate (MoO42-), dihydrogen, (T-4)-	7782-91-4	Contains (regardless of intentional or impurities)	chemical products
6226	Selenious acid	7783-00-8	Contains (regardless of intentional or impurities)	chemical products
6227	Hydrogen sulfide	7783-06-4	Contains (regardless of intentional or impurities)	chemical products
6228	Hydrogen selenide (H2Se)	7783-07-5	Contains (regardless of intentional or impurities)	chemical products
6229	Selenic acid	7783-08-6	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
6230	Dihydrogen telluride	7783-09-7	Contains (regardless of intentional or impurities)	chemical products
6231	Phosphinic acid, manganese(2+) salt (2:1), monohydrate	7783-16-6	Intentional addition / 1%	chemical products
6232	Ammonium selenite	7783-19-9	Contains (regardless of intentional or impurities)	chemical products
6233	Selenic acid, diammonium salt	7783-21-3	Contains (regardless of intentional or impurities)	chemical products
6234	Uranate, diammonium	7783-22-4	Contains (regardless of intentional or impurities)	chemical products
6235	Zinc ammonium sulfate	7783-24-6	Intentional addition / 1%	chemical products
6236	Mercury(II) potassium iodide	7783-33-7	Contains (regardless of intentional or impurities)	chemical products
6237	Selenium difluoride monoxide	7783-43-9	Contains (regardless of intentional or impurities)	chemical products
6238	Stannous fluoride	7783-47-3	Contains (regardless of intentional or impurities)	chemical products
6239	Zinc fluoride	7783-49-5	Contains (regardless of intentional or impurities)	chemical products
6240	Ferric fluoride	7783-50-8	Contains (regardless of intentional or impurities)	chemical products
6241	Indium(III) fluoride	7783-52-0	Contains (regardless of intentional or impurities)	chemical products
6242	Manganese fluoride (MnF3)	7783-53-1	Contains (regardless of intentional or impurities)	chemical products
6243	Nitrogen trifluoride	7783-54-2	Contains (regardless of intentional or impurities)	chemical products
6244	Phosphorus trifluoride	7783-55-3	Contains (regardless of intentional or impurities)	chemical products
6245	Antimony trifluoride	7783-56-4	Contains (regardless of intentional or impurities)	chemical products
6246	Thallium fluoride (TlF3)	7783-57-5	Contains (regardless of intentional or impurities)	chemical products
6247	Sulfur tetrafluoride	7783-60-0	Contains (regardless of intentional or impurities)	chemical products
6248	Silicon tetrafluoride	7783-61-1	Contains (regardless of intentional or impurities)	chemical products
6249	Tetrafluorostannane	7783-62-2	Contains (regardless of intentional or impurities)	chemical products
6250	Zirconium fluoride (ZrF4), (T-4)-	7783-64-4	Contains (regardless of intentional or impurities)	chemical products
6251	Iodine pentafluoride	7783-66-6	Contains (regardless of intentional or impurities)	chemical products
6252	Antimony pentafluoride	7783-70-2	Contains (regardless of intentional or impurities)	chemical products
6253	Vanadium pentafluoride	7783-72-4	Contains (regardless of intentional or impurities)	chemical products
6254	Molybdenum fluoride (MoF6), (OC-6-11)-	7783-77-9	Contains (regardless of intentional or impurities)	chemical products
6255	Selenium hexafluoride	7783-79-1	Contains (regardless of intentional or impurities)	chemical products
6256	Tellurium hexafluoride	7783-80-4	Contains (regardless of intentional or impurities)	chemical products
6257	Uranium hexafluoride	7783-81-5	Contains (regardless of intentional or impurities)	chemical products
6258	Tungsten hexafluoride	7783-82-6	Contains (regardless of intentional or impurities)	chemical products
6259	Iron(III) ammonium sulfate dodecahydrate	7783-83-7	Intentional addition / 1%	chemical products
6260	Iron tris(phosphinate)	7783-84-8	Intentional addition / 1%	chemical products
6261	Sulfuric acid, ammonium iron(2+) salt (2:2:1), hexahydrate	7783-85-9	Intentional addition / 1%	chemical products
6262	Iron iodide (FeI2)	7783-86-0	Intentional addition / 1%	chemical products
6263	Silver bromate	7783-89-3	Contains (regardless of intentional or impurities)	chemical products
6264	Silver chlorate	7783-90-6	Intentional addition / 1,000ppm	chemical products
6265	Silver chlorite	7783-91-7	Intentional addition / 25%	chemical products
6266	Silver chlorate	7783-92-8	Contains (regardless of intentional or impurities)	chemical products
6267	Perchloric acid, silver(1+) salt	7783-93-9	Contains (regardless of intentional or impurities)	chemical products
6268	Silver fluoride (AgF2)	7783-95-1	Contains (regardless of intentional or impurities)	chemical products
6269	Silver iodide (AgI)	7783-96-2	Contains (regardless of intentional or impurities)	chemical products
6270	Iodic acid (HIO3), silver(1+) salt	7783-97-3	Contains (regardless of intentional or impurities)	chemical products
6271	Silver permanganate	7783-98-4	Contains (regardless of intentional or impurities)	chemical products
6272	Nitrous acid, silver(1+) salt	7783-99-5	Contains (regardless of intentional or impurities)	chemical products
6273	Silver chromate	7784-01-2	Contains (regardless of intentional or impurities)	chemical products
6274	Silver dichromate	7784-02-3	Contains (regardless of intentional or impurities)	chemical products
6275	Disilver selenite	7784-05-6	Contains (regardless of intentional or impurities)	chemical products
6276	Silver selenate	7784-07-8	Intentional addition / 1,000ppm	chemical products
6277	Silver arsenite	7784-08-9	Contains (regardless of intentional or impurities)	chemical products
6278	Phosphoric acid, trisilver(1+) salt	7784-09-0	Intentional addition / 25%	chemical products
6279	Aluminum bromide, hexahydrate	7784-11-4	Intentional addition / 1%	chemical products
6280	Aluminum chloride, hexahydrate	7784-13-6	Intentional addition / 1%	chemical products
6281	Aluminum fluoride	7784-18-1	Contains (regardless of intentional or impurities)	chemical products
6282	Sulfuric acid, aluminum potassium salt (2:1:1), dodecahydrate	7784-24-9	Intentional addition / 1,000ppm	chemical products
6283	Sulfuric acid, aluminum ammonium salt (2:1:1)	7784-25-0	Intentional addition / 1,000ppm	chemical products
6284	Sulfuric acid, aluminum ammonium salt (2:1:1), dodecahydrate	7784-26-1	Intentional addition / 1%	chemical products
6285	Aluminum nitrate nonahydrate	7784-27-2	Contains (regardless of intentional or impurities)	chemical products
6286	Sulfuric acid, aluminum salt (3:2), octadecahydrate	7784-31-8	Intentional addition / 1%	chemical products
6287	Arsenic bromide	7784-33-0	Contains (regardless of intentional or impurities)	chemical products
6288	Arsenous trichloride	7784-34-1	Contains (regardless of intentional or impurities)	chemical products
6289	Arsenous trifluoride	7784-35-2	Contains (regardless of intentional or impurities)	chemical products
6290	Arsorane, pentafluoro-	7784-36-3	Contains (regardless of intentional or impurities)	chemical products
6291	Manganese hydrogenarsenate	7784-38-5	Contains (regardless of intentional or impurities)	chemical products
6292	Arsenic acid (H3AsO4), monopotassium salt	7784-41-0	Contains (regardless of intentional or impurities)	chemical products
6293	Arsine	7784-42-1	Contains (regardless of intentional or impurities)	chemical products
6294	Ammonium arsenate	7784-44-3	Contains (regardless of intentional or impurities)	chemical products
6295	Arsenous triiodide	7784-45-4	Contains (regardless of intentional or impurities)	chemical products
6296	Sodium arsenite	7784-46-5	Contains (regardless of intentional or impurities)	chemical products
6297	Sulfuric acid, ammonium manganese(2+) salt (2:2:1), hexahydrate	7785-19-5	Intentional addition / 1%	chemical products
6298	Sulfuric acid, ammonium nickel(2+) salt (2:2:1), hexahydrate	7785-20-8	Contains (regardless of intentional or impurities)	chemical products
6299	Silver bromide (AgBr)	7785-23-1	Intentional addition / 25%	chemical products
6300	Cobaltous arsenate	7785-24-2	Intentional addition / 1%	chemical products
6301	Manganese(II) sulfate	7785-87-7	Contains (regardless of intentional or impurities)	chemical products
6302	Mevinphos	7786-34-7	Contains (regardless of intentional or impurities)	chemical products
6303	Arsorane, pentahydroxy-	7786-36-9	Contains (regardless of intentional or impurities)	chemical products
6304	Nickel(II) sulfate	7786-81-4	Contains (regardless of intentional or impurities)	chemical products
6305	Barium fluoride	7787-32-8	Contains (regardless of intentional or impurities)	chemical products
6306	Barium iodide dihydrate	7787-33-9	Contains (regardless of intentional or impurities)	chemical products
6307	Barium iodate monohydrate	7787-34-0	Intentional addition	chemical products
6308	Manganic acid (H2MnO4), barium salt (1:1)	7787-35-1	Contains (regardless of intentional or impurities)	chemical products
6309	Barium permanganate	7787-36-2	Contains (regardless of intentional or impurities)	chemical products
6310	Molybdate (MoO42-), barium (1:1), (T-4)-	7787-37-3	Contains (regardless of intentional or impurities)	chemical products
6311	Barium nitrite monohydrate	7787-38-4	Contains (regardless of intentional or impurities)	chemical products
6312	Barium sulphite	7787-39-5	Contains (regardless of intentional or impurities)	chemical products
6313	Selenic acid, barium salt (1:1)	7787-41-9	Contains (regardless of intentional or impurities)	chemical products
6314	Tungstate (WO42-), barium (1:1), (T-4)-	7787-42-0	Intentional addition / 1,000ppm	chemical products
6315	Beryllium bromide (BeBr2)	7787-46-4	Contains (regardless of intentional or impurities)	chemical products
6316	Beryllium chloride (BeCl2)	7787-47-5	Contains (regardless of intentional or impurities)	chemical products
6317	Beryllium fluoride (BeF2)	7787-49-7	Contains (regardless of intentional or impurities)	chemical products
6318	Beryllate(2-), tetrafluoro-, dipotassium, (T-4)-	7787-50-0	Contains (regardless of intentional or impurities)	chemical products
6319	Beryllium hydride	7787-52-2	Contains (regardless of intentional or impurities)	chemical products
6320	Beryllium iodide (BeI2)	7787-53-3	Contains (regardless of intentional or impurities)	chemical products
6321	Beryllium potassium sulfate dihydrate	7787-54-4	Contains (regardless of intentional or impurities)	chemical products
6322	Beryllium nitrate trihydrate	7787-55-5	Contains (regardless of intentional or impurities)	chemical products
6323	Beryllium sulfate tetrahydrate	7787-56-6	Contains (regardless of intentional or impurities)	chemical products
6324	Copper bromide (CuBr)	7787-70-4	Intentional addition / 1,000ppm	chemical products
6325	Selenic acid, cobalt(2+) salt (1:1), hexahydrate	7788-94-5	Intentional addition / 1%	chemical products
6326	Chromic fluoride	7788-97-8	Contains (regardless of intentional or impurities)	chemical products
6327	Ammonium chromate	7788-98-9	Contains (regardless of intentional or impurities)	chemical products
6328	Chromium(III) potassium sulfate, dodecahydrate	7788-99-0	Contains (regardless of intentional or impurities)	chemical products
6329	Lithium chromate dihydrate	7789-01-7	Contains (regardless of intentional or impurities)	chemical products
6330	Chromium(III) nitrate nonahydrate	7789-02-8	Contains (regardless of intentional or impurities)	chemical products
6331	Phosphoric acid, chromium(3+) salt (1:1)	7789-04-0	Contains (regardless of intentional or impurities)	chemical products
6332	Copper chromate dihydrate	7789-07-3	Intentional addition / 1,000ppm	chemical products
6333	Copper fluoride (CuF2)	7789-19-7	Contains (regardless of intentional or impurities)	chemical products
6334	Fluorosulfonic acid	7789-21-1	Contains (regardless of intentional or impurities)	chemical products
6335	Potassium fluoride	7789-23-3	Contains (regardless of intentional or impurities)	chemical products
6336	Thallium(I) fluoride	7789-27-7	Contains (regardless of intentional or impurities)	chemical products
6337	Iron fluoride (FeF2)	7789-28-8	Contains (regardless of intentional or impurities)	chemical products
6338	Potassium fluoride, K(HF2)	7789-29-9	Contains (regardless of intentional or impurities)	chemical products
6339	Bromine pentafluoride	7789-30-2	Contains (regardless of intentional or impurities)	chemical products
6340	Sodium bromate	7789-38-0	Contains (regardless of intentional or impurities)	chemical products
6341	Cadmium bromide	7789-42-6	Contains (regardless of intentional or impurities)	chemical products
6342	Cobalt(II) bromide	7789-43-7	Intentional addition / 1,000ppm	chemical products
6343	Copper bromide (CuBr2)	7789-45-9	Intentional addition / 1,000ppm	chemical products
6344	Iron bromide (FeBr2)	7789-46-0	Intentional addition / 1%	chemical products
6345	Nickel bromide (NiBr2), trihydrate	7789-49-3	Contains (regardless of intentional or impurities)	chemical products
6346	Seleninyl bromide	7789-51-7	Contains (regardless of intentional or impurities)	chemical products
6347	Selenium bromide (Se2Br2)	7789-52-8	Contains (regardless of intentional or impurities)	chemical products
6348	Tellurium dibromide	7789-54-0	Contains (regardless of intentional or impurities)	chemical products
6349	Antimony tribromide	7789-61-9	Contains (regardless of intentional or impurities)	chemical products
6350	Yttrium bromide (YBr3), nonahydrate	7789-62-0	Intentional addition / 1%	chemical products
6351	Selenium bromide (SeBr4), (T-4)-	7789-65-3	Contains (regardless of intentional or impurities)	chemical products
6352	Stannane, tetrabromo-	7789-67-5	Contains (regardless of intentional or impurities)	chemical products
6353	Calcium dichromate (CaCr2O7) trihydrate	7789-73-3	Intentional addition / 1,000ppm	chemical products
6354	Calcium molybdate	7789-82-4	Contains (regardless of intentional or impurities)	chemical products
6355	Propane, 1,1,1-trichloro-	7789-89-1	Intentional addition / 1,000ppm	chemical products
6356	1,1-Dicyanoethyl acetate	7790-01-4	Intentional addition	chemical products
6357	Thallium(I) iodide	7790-30-9	Contains (regardless of intentional or impurities)	chemical products
6358	Manganese iodide (MnI2)	7790-33-2	Contains (regardless of intentional or impurities)	chemical products
6359	Nickel diiodide hexahydrate	7790-34-3	Intentional addition / 1,000ppm	chemical products
6360	Zinc iodate	7790-37-6	Contains (regardless of intentional or impurities)	chemical products
6361	Stibine, triiodo-	7790-44-5	Contains (regardless of intentional or impurities)	chemical products
6362	Platinum iodide (PtI4), (SP-4-1)-	7790-46-7	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
6363	Stannane, tetraiodo-	7790-47-8	Contains (regardless of intentional or impurities)	chemical products
6364	Tellurium iodide (TeI4), (T-4)-	7790-48-9	Contains (regardless of intentional or impurities)	chemical products
6365	Telluric acid (H2TeO3), dipotassium salt	7790-58-1	Contains (regardless of intentional or impurities)	chemical products
6366	Potassium selenate	7790-59-2	Contains (regardless of intentional or impurities)	chemical products
6367	Tungstate (WO42-), dipotassium, (T-4)-	7790-60-5	Intentional addition / 1,000ppm	chemical products
6368	Dipotassium heptaoxidouranate, of uranium depleted in uranium-235	7790-63-8	Contains (regardless of intentional or impurities)	chemical products
6369	Sulfuric acid, potassium zinc salt (2:2:1), hexahydrate	7790-65-0	Intentional addition / 1%	chemical products
6370	Dilithium selenate monohydrate	7790-71-8	Intentional addition / 1,000ppm	chemical products
6371	Calcium selenate dihydrate	7790-74-1	Intentional addition / 1,000ppm	chemical products
6372	Cadmium iodide	7790-80-9	Contains (regardless of intentional or impurities)	chemical products
6373	Cadmium iodate	7790-81-0	Contains (regardless of intentional or impurities)	chemical products
6374	Cadmium dimiteite	7790-83-2	Contains (regardless of intentional or impurities)	chemical products
6375	Cadmium tungsten oxide (CdWO4)	7790-85-4	Contains (regardless of intentional or impurities)	chemical products
6376	Chlorine trifluoride	7790-91-2	Contains (regardless of intentional or impurities)	chemical products
6377	Chlorosulfonic acid	7790-94-5	Contains (regardless of intentional or impurities)	chemical products
6378	Ammonium perchlorate	7790-98-9	Contains (regardless of intentional or impurities)	chemical products
6379	Perchloric acid, lithium salt	7791-03-9	Contains (regardless of intentional or impurities)	chemical products
6380	Perchloric acid, sodium salt, monohydrate	7791-07-3	Intentional addition / 1,000ppm	chemical products
6381	Stibine, chlorooxo-	7791-08-4	Contains (regardless of intentional or impurities)	chemical products
6382	Strontium chlorate	7791-10-8	Contains (regardless of intentional or impurities)	chemical products
6383	Thallous chloride	7791-12-0	Contains (regardless of intentional or impurities)	chemical products
6384	Cobalt(II) chloride, hexahydrate	7791-13-1	Intentional addition / 1,000ppm	chemical products
6385	Nickel(II) chloride hexahydrate	7791-20-0	Contains (regardless of intentional or impurities)	chemical products
6386	Selenium oxychloride	7791-23-3	Contains (regardless of intentional or impurities)	chemical products
6387	Uranyl chloride	7791-26-6	Contains (regardless of intentional or impurities)	chemical products
6388	Barium bromide (BaBr2), dihydrate	7791-28-8	Contains (regardless of intentional or impurities)	chemical products
6389	Phosphoric acid, copper(2+) salt (2:3)	7798-23-4	Intentional addition / 1,000ppm	chemical products
6390	1,1-Dichloro-1-fluoropropane	7799-56-6	Intentional addition / 1,000ppm	chemical products
6391	Hydroxylamine	7803-49-8	Contains (regardless of intentional or impurities)	chemical products
6392	Phosphine	7803-51-2	Contains (regardless of intentional or impurities)	chemical products
6393	Antimony hydride	7803-52-3	Contains (regardless of intentional or impurities)	chemical products
6394	Ammonium vanadate	7803-55-6	Contains (regardless of intentional or impurities)	chemical products
6395	Silane	7803-62-5	Contains (regardless of intentional or impurities)	chemical products
6396	Telluric acid	7803-68-1	Contains (regardless of intentional or impurities)	chemical products
6397	Quaternary ammonium compounds, alkylbenzylidimethyl, chlorides	8001-54-5	Contains (regardless of intentional or impurities)	chemical products
6398	Coal tar creosote	8001-58-9	Contains (regardless of intentional or impurities)	chemical products
6399	Petroleum	8002-05-9	Contains (regardless of intentional or impurities)	chemical products
6400	Tall oil	8002-26-4	Intentional addition / 1,000ppm	chemical products
6401	Paraffin waxes and Hydrocarbon waxes	8002-74-2	Intentional addition / 1%	chemical products
6402	Dichloropropane mixture with dichloropropene	8003-19-8	Intentional addition / 1,000ppm	chemical products
6403	Pyrethrum	8003-34-7	Contains (regardless of intentional or impurities)	chemical products
6404	Benzoic acid, 3,3'-(thiobis(phenyleneazo))bis[6-hydroxy-, disodium salt	8003-87-0	Intentional addition / 1,000ppm	chemical products
6405	C.I. Acid Red 158	8004-55-5	Intentional addition / 100ppm	chemical products
6406	Acid Black 7	8004-59-9	Intentional addition / 1,000ppm	chemical products
6407	2,7-Naphthalenedisulfonic acid, 3-hydroxy-4-[[2-methyl-4-[[2-methylphenylazo]phenylazo]-], disodium salt	8005-61-6	Intentional addition / 100ppm	chemical products
6408	C.I. Direct Red 72	8005-64-9	Intentional addition / 100ppm	chemical products
6409	2-Naphthalenesulfonic acid, amino[[2-methyl-4-[[2-methylphenylazo]phenylazo]-], monosodium salt	8006-06-2	Intentional addition / 100ppm	chemical products
6410	Gallic acid, zinc salt, basic	8006-22-2	Intentional addition / 25%	chemical products
6411	Sulfuric acid, barium salt (1:1), mixture with zinc oxide (ZnO) and zinc sulfide (ZnS)	8006-32-4	Contains (regardless of intentional or impurities)	chemical products
6412	Gasoline, natural	8006-61-9	Contains (regardless of intentional or impurities)	chemical products
6413	Turpentine, oil	8006-64-2	Contains (regardless of intentional or impurities)	chemical products
6414	C.I. Pigment Yellow 53	8007-18-9	Contains (regardless of intentional or impurities)	chemical products
6415	Coal tar	8007-45-2	Contains (regardless of intentional or impurities)	chemical products
6416	Nitric acid, fuming	8007-59-7	Intentional addition / 1,000ppm	chemical products
6417	Nitrosine, petroleum	8008-20-6	Contains (regardless of intentional or impurities)	chemical products
6418	Patrolatum	8008-03-8	Contains (regardless of intentional or impurities)	chemical products
6419	Barium sulfide, black	8011-62-9	Intentional addition / 1,000ppm	chemical products
6420	Bordeaux mixture	8011-63-0	Contains (regardless of intentional or impurities)	chemical products
6421	C.I. Pigment Green 19	8011-87-8	Intentional addition / 1,000ppm	chemical products
6422	Arsenic triiodide mixed with mercuric iodide	8012-54-2	Intentional addition / 100ppm	chemical products
6423	Copper chloride hydroxide (Cu2O(OH)3), mixture with copper hydroxide sulfate (Cu4(OH)6(SO4))	8012-69-9	Intentional addition / 1,000ppm	chemical products
6424	Paraffin oils	8012-95-1	Contains (regardless of intentional or impurities)	chemical products
6425	C.I. Pigment Brown 9	8014-85-5	Intentional addition / 1,000ppm	chemical products
6426	Benzoic acid, 3,3'-[[3,7-disulfo-1,5-naphthalenediyl]bis[azo(6-hydroxy-3,1-phenylene)azo(6(or 7)-sulfo-4,1-naphthalenediylazo)1,1'-biphenyl]-4,4'-diylazo]]bis[6-hydroxy-, hexasodium salt	8014-91-3	Contains (regardless of intentional or impurities)	chemical products
6427	Sulfuric acid, fuming	8014-95-7	Contains (regardless of intentional or impurities)	chemical products
6428	Tall-oil pitch	8016-81-7	Intentional addition / 1,000ppm	chemical products
6429	Phenylmercuric borate	8017-88-7	Contains (regardless of intentional or impurities)	chemical products
6430	Nitrous acid, 2-methylbutyl ester, mixture with 3-methylbutyl nitrate	8017-89-8	Intentional addition / 1,000ppm	chemical products
6431	Mancozeb	8018-01-7	Contains (regardless of intentional or impurities)	chemical products
6432	Creosote, wood	8021-39-4	Contains (regardless of intentional or impurities)	chemical products
6433	Phosphorothioic acid, O-[2-(ethylthio)ethyl] O,O-dimethyl ester, mixture with S-[2-(ethylthio)ethyl] O,O-dimethyl phosphorothioate	8022-00-2	Intentional addition / 1%	chemical products
6434	Boric acid (HBO2), sodium salt, tetrahydrate, mixture with N-(3,4-dichlorophenyl)-N,N-dimethylurea	8027-85-8	Intentional addition / 1%	chemical products
6435	Flue dust, arsenic-containing	8028-73-7	Contains (regardless of intentional or impurities)	chemical products
6436	Naphtha	8030-30-6	Contains (regardless of intentional or impurities)	chemical products
6437	Fatty acids, tall-oil, manganese salts	8030-70-4	Contains (regardless of intentional or impurities)	chemical products
6438	Ligroine	8032-32-4	Contains (regardless of intentional or impurities)	chemical products
6439	White mineral oil, petroleum	8042-47-5	Intentional addition / 1,000ppm	chemical products
6440	Sulfuric acid, barium salt (1:1), mixture with manganic acid (H2MnO4) barium salt (1:1)	8046-59-1	Contains (regardless of intentional or impurities)	chemical products
6441	C.I. Pigment Yellow 35	8048-07-5	Contains (regardless of intentional or impurities)	chemical products
6442	Phenol, 2-(1-methylpropyl)-4,6-dinitro-, alkanolamine salts	8048-12-2	Intentional addition	chemical products
6443	Devarda's alloy, granular	8049-11-4	Intentional addition / 1,000ppm	chemical products
6444	Steel flake, stainless	8049-16-9	Contains (regardless of intentional or impurities)	chemical products
6445	Rosin	8050-09-7	Contains (regardless of intentional or impurities)	chemical products
6446	Resin acids and Rosin acids, hydrogenated, methyl esters	8050-15-5	Intentional addition / 1,000ppm	chemical products
6447	Stoddard solvent	8052-41-3	Contains (regardless of intentional or impurities)	chemical products
6448	Asphalt	8052-42-4	Intentional addition / 1%	chemical products
6449	Iron strychnine citrate	8052-88-8	Contains (regardless of intentional or impurities)	chemical products
6450	Strychnidin-10-one, 2-hydroxy-1,2,3-propanetricarboxylate, mixture with (8.alpha.,9R)-6-methoxycinchonan-9-ol iron salt	8062-13-3	Contains (regardless of intentional or impurities)	chemical products
6451	Curare	8063-06-7	Intentional addition	chemical products
6452	Reactive Violet 2	8063-57-8	Intentional addition / 1,000ppm	chemical products
6453	1,3,2-Dioxaborinane, 2,2'-oxybis[4,4,6-trimethyl-, mixture with 2,2'-[[1-methyl-1,3-propanediyl]bis(oxy)]bis[4-methyl-1,3,2-dioxaborinane]	8063-89-6	Intentional addition / 1%	chemical products
6454	Manganese, [[1,2-ethanediy]bis(carbamodithioato)](2-)-, mixture with [[1,2-ethanediy]bis(carbamodithioato)](2-)-zinc and 2(or 4)-isooctyl-4,6(or 2,6)-dinitrophenyl 2-butenoate	8064-42-4	Contains (regardless of intentional or impurities)	chemical products
6455	Demeton	8065-48-3	Contains (regardless of intentional or impurities)	chemical products
6456	Cuprocin	8066-21-5	Intentional addition / 1,000ppm	chemical products
6457	Zinc, bis(dimethylcarbamodithioato-S,S),(T-4),mixture with dimethyl carbamodithioic acid bis(anhydrosulfide) with methylarsondithioic acid, dimethylcarbamodithioic acid tris(anhydrosulfide) with arsenotriothic acid and tetramethylthiooxydicarbonic diamide	8066-44-2	Contains (regardless of intentional or impurities)	chemical products
6458	Yohimban-16-carboxylic acid, 17-hydroxy-, methyl ester (16.alpha.,17.alpha.-, mixture with [2R-(2R*(4R*8R*))]-3,4-dihydro-2,5,7,8-tetramethyl-2-(4,8,12-trimethyltridecyl)-2H-1-benzopyran-6-yl acetate,(1.alpha.,5.alpha.,17.alpha.)-17-hydroxy-1-methylandrostan-3-one,magnesium di-3-pyridinecarboxylate and strychnidin-10-one mononitrate	8067-17-2	Contains (regardless of intentional or impurities)	chemical products
6459	Mercurate(1-), (3-(((3-carboxylato-1-oxopropyl)amino)carbonyl)amino)-2-methoxypropyl]hydroxy-, sodium, mixed with 3,7-dihydro-1,3-dimethyl-1H-purine-2,6-dione	8069-64-5	Contains (regardless of intentional or impurities)	chemical products
6460	Tetrachloroethane	8071-14-5	Intentional addition	chemical products
6461	Manganese, [[1,2-ethanediy]bis(carbamodithioato)](2-)-, mixture with [[1,2-ethanediy]bis(carbamodithioato)](2-)-zinc and methyl 1-[[[butylamino]carbonyl]-1H-benzimidazol-2-yl]carbamate	8072-27-3	Contains (regardless of intentional or impurities)	chemical products
6462	Lignosulfonic acid, chromium iron salt	8075-74-9	Intentional addition / 1,000ppm	chemical products
6463	Barium sulfide mixture with sulfur	8077-30-3	Intentional addition	chemical products
6464	Oxidase, diamine	9001-53-0	Intentional addition / 1,000ppm	chemical products
6465	Amberlite IRC 50	9002-29-3	Intentional addition / 1,000ppm	chemical products
6466	Polyvinyl chloride	9002-86-2	Intentional addition	chemical products
6467	Ethoxylated lauryl alcohol	9002-92-0	1%	chemical products
6468	Formaldehyde, polymer with (chloromethyl)oxirane and phenol	9003-36-5	1%	chemical products
6469	Cyclohexene, 1-methyl-4-(1-methylethyl)-, homopolymer	9003-73-0	Intentional addition / 1%	chemical products
6470	Phenol, 4,4'-ethylidenebis-, polymer with (chloromethyl)oxirane	9003-85-4	1%	chemical products
6471	Cellulose	9004-34-6	Contains (regardless of intentional or impurities)	chemical products
6472	Cellulose, 2-cyanoethyl ether	9004-41-5	Intentional addition	chemical products
6473	Nitrocellulose	9004-70-0	Contains (regardless of intentional or impurities)	chemical products
6474	Poly(oxy-1,2-ethanediy), .alpha.-sulfo-.omega.-(dodecyloxy)-, sodium salt	9004-82-4	Intentional addition / 1%	chemical products
6475	Lignin	9005-53-2	1,000ppm	chemical products
6476	Calcium resinate	9007-13-0	Contains (regardless of intentional or impurities)	chemical products
6477	Copper resinate	9007-39-0	Intentional addition / 1,000ppm	chemical products
6478	Manganese resinate	9008-34-8	Contains (regardless of intentional or impurities)	chemical products
6479	Ethene, chlorotrifluoro-, polymer with 1,1-difluoroethene	9010-75-7	1,000ppm	chemical products
6480	Vinyl chloride-vinylidene chloride copolymer	9011-06-7	1,000ppm	chemical products
6481	1-Propene, 1,1,2,3,3,3-hexafluoro-, polymer with 1,1-difluoroethene	9011-17-0	1,000ppm	chemical products
6482	Subtilisin	9014-01-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
6483	Poly(oxy-1,2-ethanedivyl).alpha.-sulfo-omega-(nonylphenoxy)-, sodium salt	9014-90-8	1,000ppm	chemical products
6484	Alginic acid, barium salt	9019-41-4	Intentional addition / 1,000ppm	chemical products
6485	Alginic acid, copper(2+) salt	9019-44-7	Intentional addition / 1,000ppm	chemical products
6486	2-Propanoic acid, manganese salt, homopolymer	9038-47-5	Contains (regardless of intentional or impurities)	chemical products
6487	Poly(oxy-1,2-ethanedivyl).alpha.-isotridecyl-omega-hydroxy-	9043-30-5	1%	chemical products
6488	Poly(oxy(methyl-1,2-ethanedivyl).alpha.-[2-aminomethyl]ethyl)-omega-(2-aminomethylethoxy)-	9046-10-0	1,000ppm	chemical products
6489	Poly(oxy-1,2-ethanedivyl).alpha.-sulfo-omega-(nonylphenoxy)-, ammonium salt (1:1)	9051-57-4	1,000ppm	chemical products
6490	Dismutase, superoxide	9054-89-1	Intentional addition / 1,000ppm	chemical products
6491	Poly(oxy-1,2-ethanedivyl).alpha.-[octyl(phenyl)-omega-hydroxy-	9063-89-2	1%	chemical products
6492	Ammonium polysulfide	9080-17-5	Contains (regardless of intentional or impurities)	chemical products
6493	Nicotine, galate	10020-05-0	Contains (regardless of intentional or impurities)	chemical products
6494	Barium nitrate	10022-51-8	Contains (regardless of intentional or impurities)	chemical products
6495	Sulfuric acid, ammonium chromium(3+) salt (2:1), dodecahydrate	10022-47-6	1,000ppm	chemical products
6496	Chromic acid (H2CrO4), dilithium salt, dihydrate	10022-48-7	1,000ppm	chemical products
6497	Nitryl fluoride	10022-50-1	Contains (regardless of intentional or impurities)	chemical products
6498	Strontium bromate monohydrate	10022-52-3	1%	chemical products
6499	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, manganese salt	10024-66-5	Contains (regardless of intentional or impurities)	chemical products
6500	Nitrous oxide	10024-97-2	Contains (regardless of intentional or impurities)	chemical products
6501	Zinc perchlorate hexahydrate	10025-64-6	Intentional addition / 1,000ppm	chemical products
6502	Sulfur chloride (S2Cl2)	10025-67-9	Contains (regardless of intentional or impurities)	chemical products
6503	Selenium chloride (Se2Cl2)	10025-68-0	Contains (regardless of intentional or impurities)	chemical products
6504	Tin chloride (SnCl2), dihydrate	10025-69-1	Contains (regardless of intentional or impurities)	chemical products
6505	Chromic chloride	10025-73-7	Contains (regardless of intentional or impurities)	chemical products
6506	Ferric chloride hexahydrate	10025-77-1	1%	chemical products
6507	Trichlorosilane	10025-78-2	Contains (regardless of intentional or impurities)	chemical products
6508	Indium chloride (InCl3)	10025-82-8	1%	chemical products
6509	Phosphoric trichloride	10025-87-3	Contains (regardless of intentional or impurities)	chemical products
6510	Antimony trichloride	10025-91-9	Contains (regardless of intentional or impurities)	chemical products
6511	Uranium trichloride	10025-93-1	Contains (regardless of intentional or impurities)	chemical products
6512	Yttrium chloride (YCl3), hexahydrate	10025-94-2	1%	chemical products
6513	Potassium tetrachloroplatinate(II)	10025-99-7	Contains (regardless of intentional or impurities)	chemical products
6514	Platinate(2-), tetrachloro- disodium, (SP-4-1)-	10026-00-3	Contains (regardless of intentional or impurities)	chemical products
6515	Selenium chloride (SeCl4), (T-4)-	10026-03-6	Contains (regardless of intentional or impurities)	chemical products
6516	Stannic chloride, pentahydrate	10026-06-9	Contains (regardless of intentional or impurities)	chemical products
6517	Tellurium tetrachloride	10026-07-0	Contains (regardless of intentional or impurities)	chemical products
6518	Uranium tetrachloride	10026-10-5	Contains (regardless of intentional or impurities)	chemical products
6519	Zirconium chloride (ZrCl4), (T-4)-	10026-11-6	Contains (regardless of intentional or impurities)	chemical products
6520	Phosphorus pentachloride	10026-13-8	Contains (regardless of intentional or impurities)	chemical products
6521	Cobalt(III) fluoride	10026-17-2	Contains (regardless of intentional or impurities)	chemical products
6522	Cobalt fluoride (CoF3)	10026-18-3	Contains (regardless of intentional or impurities)	chemical products
6523	Cobalt(III) potassium sulfate hexahydrate	10026-20-7	Intentional addition / 1%	chemical products
6524	Cobalt(2+) selenite	10026-23-0	Contains (regardless of intentional or impurities)	chemical products
6525	Sulfuric acid, cobalt(2+) salt (1:1), heptahydrate	10026-24-1	Contains (regardless of intentional or impurities)	chemical products
6526	Copper phthalate	10027-30-2	Intentional addition / 1,000ppm	chemical products
6527	Ozone	10028-15-6	Contains (regardless of intentional or impurities)	chemical products
6528	Tellurium, Te2	10028-16-7	Contains (regardless of intentional or impurities)	chemical products
6529	Tritium	10028-17-8	Contains (regardless of intentional or impurities)	chemical products
6530	Nickel fluoride (NiF2)	10028-18-9	Contains (regardless of intentional or impurities)	chemical products
6531	Sulfuric acid, iron(2+) salt (1:1), dihydrate	10028-21-4	1%	chemical products
6532	Sulfuric acid, iron(3+) salt (3:2)	10028-22-5	Intentional addition / 1%	chemical products
6533	Iron succinate	10030-90-7	1%	chemical products
6534	Barium dichromate dihydrate	10031-16-0	Contains (regardless of intentional or impurities)	chemical products
6535	Manganese bromide (MnBr2), tetrahydrate	10031-20-6	Contains (regardless of intentional or impurities)	chemical products
6536	Tin bromide (SnBr2)	10031-24-0	Contains (regardless of intentional or impurities)	chemical products
6537	Chromium bromide (CrBr3)	10031-25-1	Contains (regardless of intentional or impurities)	chemical products
6538	Iron bromide (FeBr3)	10031-26-2	1%	chemical products
6539	Tellurium bromide (TeBr4), (T-4)-	10031-27-3	Contains (regardless of intentional or impurities)	chemical products
6540	Calcium nitrite hydrate	10031-34-2	Intentional addition / 100ppm	chemical products
6541	Sulfuric acid, chromium(3+) salt (3:2), pentadecahydrate	10031-37-5	Contains (regardless of intentional or impurities)	chemical products
6542	Nitric acid, copper(2+) salt, trihydrate	10031-43-3	Contains (regardless of intentional or impurities)	chemical products
6543	Copper(II) selenate pentahydrate	10031-45-5	Contains (regardless of intentional or impurities)	chemical products
6544	Phosphoric acid, copper(2+) salt (2:3), trihydrate	10031-48-8	Intentional addition / 1,000ppm	chemical products
6545	Thallium sulfate	10031-59-1	Contains (regardless of intentional or impurities)	chemical products
6546	Magnesium perchlorate	10034-81-8	Contains (regardless of intentional or impurities)	chemical products
6547	Chromic acid (H2CrO4), disodium salt, tetrahydrate	10034-82-9	Contains (regardless of intentional or impurities)	chemical products
6548	Hydriodic acid	10034-85-2	Contains (regardless of intentional or impurities)	chemical products
6549	Hydrazine, sulfate (1:1)	10034-93-2	Contains (regardless of intentional or impurities)	chemical products
6550	Manganese sulfate monohydrate	10034-96-5	Contains (regardless of intentional or impurities)	chemical products
6551	Hydrobromic acid	10035-10-6	Contains (regardless of intentional or impurities)	chemical products
6552	m-Fluorobenzyl cyanide	10036-43-8	Contains (regardless of intentional or impurities)	chemical products
6553	Beryllium selenate tetrahydrate	10039-31-3	Contains (regardless of intentional or impurities)	chemical products
6554	5,7,12-Trioxa-6-stannaoctadeca-2,9-dienoic acid, 14-ethyl-6,6-dioctyl-4,8,11-trioxo-, 2-ethylhexyl ester	10039-33-5	Contains (regardless of intentional or impurities)	chemical products
6555	Hydroxylamine sulfate (2:1)	10039-54-0	Contains (regardless of intentional or impurities)	chemical products
6556	Hydrazine, monohydriodide	10039-55-1	Contains (regardless of intentional or impurities)	chemical products
6557	Sulfuric acid, aluminum salt (3:2)	10043-01-3	Intentional addition / 1%	chemical products
6558	Boron nitride (BN)	10043-11-5	1%	chemical products
6559	Ethanedioic acid, potassium salt	10043-22-8	Intentional addition / 1,000ppm	chemical products
6560	Iodine 131	10043-66-0	Contains (regardless of intentional or impurities)	chemical products
6561	Sulfuric acid, aluminum potassium salt (2:1:1)	10043-67-1	Intentional addition / 1,000ppm	chemical products
6562	Phosphonic acid, manganese(2+) salt (2:1)	10043-84-2	Contains (regardless of intentional or impurities)	chemical products
6563	Radon	10043-92-2	Contains (regardless of intentional or impurities)	chemical products
6564	Sulfuric acid, iron(2+) ammonium salt (2:1:2)	10045-89-3	Intentional addition / 1%	chemical products
6565	Cesium 137	10045-97-3	Contains (regardless of intentional or impurities)	chemical products
6566	Hydroxylamine sulfate (1:1)	10046-00-1	Contains (regardless of intentional or impurities)	chemical products
6567	Nicotine, 1-hydroxy-2-naphthoate	10047-35-5	Contains (regardless of intentional or impurities)	chemical products
6568	Arsenic acid (H3AsO4), disodium salt, heptahydrate	10048-95-0	Contains (regardless of intentional or impurities)	chemical products
6569	Phosphoric acid, barium salt (1:1)	10048-98-3	Intentional addition / 1,000ppm	chemical products
6570	Chlorine dioxide	10049-04-4	Contains (regardless of intentional or impurities)	chemical products
6571	Chromic(III) chloride	10049-05-5	Contains (regardless of intentional or impurities)	chemical products
6572	Rhodium chloride (RhCl3)	10049-07-7	Contains (regardless of intentional or impurities)	chemical products
6573	Chromium difluoride	10049-10-2	Contains (regardless of intentional or impurities)	chemical products
6574	Vanadium trifluoride	10049-12-4	Contains (regardless of intentional or impurities)	chemical products
6575	Uranium tetrafluoride	10049-14-6	Contains (regardless of intentional or impurities)	chemical products
6576	Vanadium tetrafluoride	10049-16-8	Contains (regardless of intentional or impurities)	chemical products
6577	Antimony(V) sodium trioxide 1/4-water	10049-22-6	Contains (regardless of intentional or impurities)	chemical products
6578	Telluric acid (H2TeO3)	10049-23-7	Contains (regardless of intentional or impurities)	chemical products
6579	Boric acid (H3BO3), compound with 2,2',2''-nitrotris[ethanol]	10049-36-2	1%	chemical products
6580	Iron(3+) hydrogen N,N'-ethylenebis[N-(carboxylatomethyl)aminoacetate]	10058-42-1	Intentional addition / 1,000ppm	chemical products
6581	Chromic acid (H2CrO4), calcium salt (1:1), dihydrate	10060-08-9	Contains (regardless of intentional or impurities)	chemical products
6582	Selenic acid, cadmium salt (1:1), dihydrate	10060-09-0	Intentional addition / 1,000ppm	chemical products
6583	Chromium(III) chloride hexahydrate	10060-12-5	Contains (regardless of intentional or impurities)	chemical products
6584	Cuprates(2-), tetrachloro-, diammonium, dihydrate	10060-13-6	Intentional addition / 1,000ppm	chemical products
6585	Trimanganese dictrate	10060-26-1	Contains (regardless of intentional or impurities)	chemical products
6586	cis-1,3-Dichloropropene	10061-01-5	Contains (regardless of intentional or impurities)	chemical products
6587	trans-1,3-Dichloropropene	10061-02-6	Contains (regardless of intentional or impurities)	chemical products
6588	Dipotassium tetrachlorocuprate(2-) dihydrate	10085-76-4	Intentional addition / 1,000ppm	chemical products
6589	Aluminum iodide hexahydrate	10090-53-6	1%	chemical products
6590	Antimonate (SbO3 <sup>1-</sup> ), potassium, hydrate	10090-54-7	Contains (regardless of intentional or impurities)	chemical products
6591	Yttrium 90	10098-91-6	Contains (regardless of intentional or impurities)	chemical products
6592	Strontium 90	10098-97-2	Contains (regardless of intentional or impurities)	chemical products
6593	Sodium permanganate	10101-50-5	Contains (regardless of intentional or impurities)	chemical products
6594	Silicic acid (H4SiO4), zirconium(4+) salt (1:1)	10101-52-7	Contains (regardless of intentional or impurities)	chemical products
6595	Sulfuric acid, chromium(3+) salt (3:2)	10101-53-8	Contains (regardless of intentional or impurities)	chemical products
6596	Phosphoric acid, cobalt(2+) salt (2:3), hydrate	10101-56-1	Intentional addition / 1,000ppm	chemical products
6597	Cobalt tungsten oxide	10101-58-3	Intentional addition / 1%	chemical products
6598	Phosphoric acid, ammonium iron(2+) salt (1:1:1)	10101-60-7	1%	chemical products
6599	Diphosphoric acid, ammonium manganese(3+) salt (1:1:1)	10101-66-3	Contains (regardless of intentional or impurities)	chemical products
6600	Sulfuric acid, manganese(2+) salt (1:1), tetrahydrate	10101-68-5	Contains (regardless of intentional or impurities)	chemical products
6601	Chromic acid (H2CrO4), tin(4+) salt (2:1)	10101-75-4	Contains (regardless of intentional or impurities)	chemical products
6602	Telluric acid (H2TeO4), disodium salt	10101-83-4	Contains (regardless of intentional or impurities)	chemical products
6603	Nickel(2+) selenite	10101-96-9	Contains (regardless of intentional or impurities)	chemical products
6604	Nickel(II) sulfate hexahydrate (1:1:6)	10101-97-0	Contains (regardless of intentional or impurities)	chemical products
6605	Sulfuric acid, nickel(2+) salt (1:1), heptahydrate	10101-98-1	Contains (regardless of intentional or impurities)	chemical products
6606	Selenic acid, nickel(2+) salt (1:1), hexahydrate	10101-99-2	Intentional addition / 1,000ppm	chemical products
6607	Uranyl nitrate	10102-06-4	Contains (regardless of intentional or impurities)	chemical products
6608	Sodium selenite	10102-18-8	Contains (regardless of intentional or impurities)	chemical products
6609	Sodium tellurite	10102-20-2	Contains (regardless of intentional or impurities)	chemical products
6610	Selenic acid, disodium salt, decahydrate	10102-23-5	Contains (regardless of intentional or impurities)	chemical products
6611	Sodium permanganate trihydrate	10102-36-0	Contains (regardless of intentional or impurities)	chemical products
6612	Disodium molybdate dihydrate	10102-40-6	Contains (regardless of intentional or impurities)	chemical products
6613	Nitrogen monoxide	10102-43-9	Contains (regardless of intentional or impurities)	chemical products
6614	Nitrogen dioxide	10102-44-0	Contains (regardless of intentional or impurities)	chemical products
6615	Thallium(I) nitrate	10102-45-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
6616	Arsenic acid, iron(3+) salt (1:1)	10102-49-5	Contains (regardless of intentional or impurities)	chemical products
6617	Arsenic acid, iron(2+) salt (2:3)	10102-50-8	Contains (regardless of intentional or impurities)	chemical products
6618	Arsenic acid	10102-53-1	Contains (regardless of intentional or impurities)	chemical products
6619	Calcium bromate	10102-75-7	1%	chemical products
6620	Diphosphoric acid, copper salt	10102-90-6	Intentional addition / 1,000ppm	chemical products
6621	Strychnidin-10-one, phosphonite (1:1)	10103-26-1	Contains (regardless of intentional or impurities)	chemical products
6622	Chromium nitrate	10103-47-6	Intentional addition / 1,000ppm	chemical products
6623	Phosphoric acid, copper salt	10103-48-7	Intentional addition / 1,000ppm	chemical products
6624	Arsenic acid (H3AsO4), magnesium salt (1:?)	10103-50-1	Contains (regardless of intentional or impurities)	chemical products
6625	Arsenic acid (H3AsO4), monosodium salt	10103-50-3	Contains (regardless of intentional or impurities)	chemical products
6626	Arsenic acid (H3AsO4), copper salt (1:?)	10103-51-4	Contains (regardless of intentional or impurities)	chemical products
6627	Arsenic acid (H3AsO4), calcium salt (1:?)	10103-82-5	Contains (regardless of intentional or impurities)	chemical products
6628	Selenic acid (H2SeO4), monosodium salt	10112-94-4	Contains (regardless of intentional or impurities)	chemical products
6629	Diacetoxylbenzylstannane	10113-34-5	Contains (regardless of intentional or impurities)	chemical products
6630	Potassium sulfite	10117-38-1	1,000ppm	chemical products
6631	Calcium permanganate	10118-76-0	Contains (regardless of intentional or impurities)	chemical products
6632	Zirconium chloride hydroxide	10119-31-0	Contains (regardless of intentional or impurities)	chemical products
6633	Sulfuric acid, iron salt	10124-49-9	1%	chemical products
6634	Arsenious acid (H3AsO3), potassium salt (1:?)	10124-50-2	Contains (regardless of intentional or impurities)	chemical products
6635	Manganese phosphates	10124-54-6	Contains (regardless of intentional or impurities)	chemical products
6636	Manganese sulphate	10124-55-7	Contains (regardless of intentional or impurities)	chemical products
6637	Copper(2+) chloride dihydrate	10125-13-0	Intentional addition / 1,000ppm	chemical products
6638	C.I. Acid Yellow 54	10127-05-6	Contains (regardless of intentional or impurities)	chemical products
6639	Cuprate(3-), [7-[[4-[[4-[[2,4-dihydroxy-5-[[2-hydroxy-5-sulphophenyl]azo]phenyl]azo]benzoyl]amino]-2-methylphenyl]azo]-2-methylphenyl]azo]-1,3-naphthalenedisulfonato(5-)-, trisodium	10127-06-7	Intentional addition / 1,000ppm	chemical products
6640	Chromate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]hydroxy-, sodium	10127-27-2	Contains (regardless of intentional or impurities)	chemical products
6641	Benzenesulfonic acid, 5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-, chromium complex	10127-28-3	1,000ppm	chemical products
6642	Calcium chlorate	10137-74-3	Contains (regardless of intentional or impurities)	chemical products
6643	Sulfuric acid, ammonium iron(3+) salt (2:1:1)	10138-04-2	Intentional addition / 1%	chemical products
6644	Uranate(2-), bis(acetato-O)dioxo-, zinc (1:1)	10138-94-0	Contains (regardless of intentional or impurities)	chemical products
6645	Zinc iodide (ZnI2)	10139-47-6	Intentional addition / 1%	chemical products
6646	Decanoic acid, cobalt salt (1:?)	10139-54-5	Intentional addition / 1%	chemical products
6647	Manganese decanoate	10139-57-8	Contains (regardless of intentional or impurities)	chemical products
6648	Rhodium nitrate	10139-58-9	Contains (regardless of intentional or impurities)	chemical products
6649	Sulfuric acid, chromium(3+) potassium salt (2:1:1)	10141-00-1	Contains (regardless of intentional or impurities)	chemical products
6650	2,3-Dichloro-2-methylpropanal	10141-22-7	Contains (regardless of intentional or impurities)	chemical products
6651	C.I. Pigment Red 117	10142-77-5	Intentional addition / 1,000ppm	chemical products
6652	1-Propanesulfonyl chloride	10147-36-1	Contains (regardless of intentional or impurities)	chemical products
6653	3-(Phenylsulphonyl)propionitrile	10154-75-3	Intentional addition	chemical products
6654	Phosphoselenic acid, ethyl-, Se-[2-(diethylamino)ethyl] O-ethyl ester	10161-84-9	Contains (regardless of intentional or impurities)	chemical products
6655	Tris(2-amino-1-methylethyl) borate	10164-64-4	1%	chemical products
6656	Boric acid (H3BO3), aluminum salt (1:1)	10167-67-6	1%	chemical products
6657	Decacarbonyldimanganese	10170-69-1	Contains (regardless of intentional or impurities)	chemical products
6658	Silicic acid (H4SiO4), iron(2+) salt (1:2)	10179-73-4	1%	chemical products
6659	Phenol, 2,2'-methylenebis[4-chloro-, monosodium salt	10187-52-7	1,000ppm	chemical products
6660	Carbonimidodithioic acid, cyano-, dimethyl ester	10191-60-3	Intentional addition	chemical products
6661	Ammonium chlorate	10192-29-7	Contains (regardless of intentional or impurities)	chemical products
6662	Diboron trizinc hexaoxide	10192-46-8	Contains (regardless of intentional or impurities)	chemical products
6663	Dibutyltin maleate	10192-92-4	Contains (regardless of intentional or impurities)	chemical products
6664	Nitric acid, zinc salt, hexahydrate	10196-19-6	Intentional addition / 1%	chemical products
6665	Tetradecanoic acid, barium salt	10196-66-4	Intentional addition / 1,000ppm	chemical products
6666	Tetradecanoic acid, cadmium salt	10196-67-5	Contains (regardless of intentional or impurities)	chemical products
6667	Benzoic acid, 4-(1,1-dimethylethyl)-, barium salt	10198-68-6	Contains (regardless of intentional or impurities)	chemical products
6668	Cobalt 60	10198-40-0	Contains (regardless of intentional or impurities)	chemical products
6669	Bis(triphenylphosphine) palladium chloride	10199-34-5	Contains (regardless of intentional or impurities)	chemical products
6670	2,2-Dioxo-1,2-lambda.6-oxathiolan-4-yl	10200-48-3	Contains (regardless of intentional or impurities)	chemical products
6671	Bis(pentane-2,4-dionato-O,O')beryllium	10210-64-7	Contains (regardless of intentional or impurities)	chemical products
6672	Dicobalt octacarbonyl	10210-68-1	Contains (regardless of intentional or impurities)	chemical products
6673	Vanadium dichloride oxide	10213-09-9	Intentional addition / 1%	chemical products
6674	Tungstate (WO42-), disodium, dihydrate, (T-4)-	10213-10-2	1%	chemical products
6675	Diphosphoric acid, iron sodium salt	10213-94-2	1%	chemical products
6676	Selenious acid, copper(2+) salt (1:1)	10214-40-1	Contains (regardless of intentional or impurities)	chemical products
6677	Benzenamine, 3-methyl-N-(1-methylethyl)-	10219-26-8	Intentional addition	chemical products
6678	Benzenamine, N-(1,1-dimethylethyl)-2-methyl-	10219-30-4	Intentional addition	chemical products
6679	Benzenamine, N-(1,1-dimethylethyl)-4-methyl-	10219-31-5	Intentional addition	chemical products
6680	Boric acid (H3BO3), compound with 2,2,2'-nitrotris[ethanol] (1:1)	10220-75-4	1%	chemical products
6681	Acetamide, 2,2-dibromo-2-cyano-	10222-01-2	Intentional addition / 100ppm	chemical products
6682	Gold sodium thiosulfate	10233-88-2	Intentional addition	chemical products
6683	Phosphoric acid, manganese(2+) salt (2:1), dihydrate	10234-99-8	Contains (regardless of intentional or impurities)	chemical products
6684	C.I. 77745	10236-39-2	Contains (regardless of intentional or impurities)	chemical products
6685	Cobalt chloride (CoCl2)	10241-04-0	Intentional addition / 100ppm	chemical products
6686	Molybdenum pentachloride	10241-05-1	Contains (regardless of intentional or impurities)	chemical products
6687	Chromate(1-), [6-amino-5-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthalenesulfonato(3-)]hydroxy-, sodium	10241-21-1	Contains (regardless of intentional or impurities)	chemical products
6688	Chromate(3-), bis[4-amino-3-[[2-hydroxy-3,5-dinitrophenyl]azo]-1-naphthalenesulfonato(3-)]-, disodium hydrogen	10241-27-7	Contains (regardless of intentional or impurities)	chemical products
6689	1-Phenanthrenecarboxylic acid, 1,2,3,4,4a,5b,6,10,10a-decahydro-1,4a-dimethyl-7-(1-methylethyl)-, copper salt, [1R-(1.alpha.,4a.beta.,4b.alpha.,10a.alpha.)]-	10248-55-2	Intentional addition / 1,000ppm	chemical products
6690	Benzenamine, N-(1,1-dimethylethyl)-3-methyl-	10250-14-3	Intentional addition	chemical products
6691	Copper sulfate, monohydrate	10257-54-2	Intentional addition / 1,000ppm	chemical products
6692	Acetic acid, cyano-, 2-methoxyethyl ester	10258-54-5	Intentional addition	chemical products
6693	2-Propenyl chloride, 3-(3,4,5-trimethoxyphenyl)-	10263-19-1	Contains (regardless of intentional or impurities)	chemical products
6694	C.I. Pigment Brown 2	10279-43-3	Intentional addition / 1,000ppm	chemical products
6695	Sulfuric acid, chromium potassium salt	10279-63-7	Contains (regardless of intentional or impurities)	chemical products
6696	2-(1-Cyano-1-methylethyl)azocarboxamide	10288-28-5	Intentional addition	chemical products
6697	Strychnine, tartrate	10289-23-3	Contains (regardless of intentional or impurities)	chemical products
6698	Diboron copper(2+) tetraoxide	10290-09-2	Intentional addition / 1,000ppm	chemical products
6699	Copper arsenite	10290-12-7	Contains (regardless of intentional or impurities)	chemical products
6700	Sulfuric acid, disilver(1+) salt	10294-26-5	Contains (regardless of intentional or impurities)	chemical products
6701	Gold bromide (AuBr3)	10294-28-7	Intentional addition	chemical products
6702	Gold chloride (AuCl)	10294-29-8	Intentional addition	chemical products
6703	Gold iodide (AuI)	10294-31-2	Intentional addition / 1%	chemical products
6704	Boron tribromide	10294-34-5	Contains (regardless of intentional or impurities)	chemical products
6705	Boron trichloride	10294-34-5	Contains (regardless of intentional or impurities)	chemical products
6706	Barium chlorate monohydrate	10294-38-9	Contains (regardless of intentional or impurities)	chemical products
6707	Perchloric acid, barium salt, trihydrate	10294-39-0	Contains (regardless of intentional or impurities)	chemical products
6708	Barium chromate	10294-40-3	Contains (regardless of intentional or impurities)	chemical products
6709	Perchloric acid, copper(2+) salt, hexahydrate	10294-46-9	Intentional addition / 1,000ppm	chemical products
6710	Cobalt(II) phosphate octahydrate	10294-50-5	Intentional addition / 1%	chemical products
6711	Chromic acid (H2CrO4), iron(3+) salt (3:2)	10294-52-7	Contains (regardless of intentional or impurities)	chemical products
6712	Chromic acid (H2Cr2O7), iron(3+) salt (3:2)	10294-53-8	Contains (regardless of intentional or impurities)	chemical products
6713	Manganic acid (H2MnO4), dipotassium salt	10294-64-1	Contains (regardless of intentional or impurities)	chemical products
6714	Sulfuric acid, nickel(2+) potassium salt (2:1:2), hexahydrate	10294-65-2	1,000ppm	chemical products
6715	Tin iodide (SnI2)	10294-70-9	Contains (regardless of intentional or impurities)	chemical products
6716	3-Heptene, 1-bromo-4-propyl-	10297-68-4	1,000ppm	chemical products
6717	1-Phenyl-2-chloropropane	10304-81-1	1,000ppm	chemical products
6718	Decane, 1,1,1,10-tetrachloro-	10311-15-6	1,000ppm	chemical products
6719	Dodecane, 1,1,1,12-tetrachloro-	10311-16-7	1,000ppm	chemical products
6720	Dialifor	10311-84-9	Contains (regardless of intentional or impurities)	chemical products
6721	2-Chloro-5-nitropyrimidine	10320-42-0	Contains (regardless of intentional or impurities)	chemical products
6722	Dichloroborane	10325-39-0	1%	chemical products
6723	Magnesium chlorate	10326-21-3	Contains (regardless of intentional or impurities)	chemical products
6724	Zinc arsenite	10326-24-6	Contains (regardless of intentional or impurities)	chemical products
6725	Barium bromate monohydrate	10326-26-8	Intentional addition	chemical products
6726	Barium chloride (BaCl2), dihydrate	10326-27-9	Contains (regardless of intentional or impurities)	chemical products
6727	Cadmium perchlorate hexahydrate	10326-28-0	Contains (regardless of intentional or impurities)	chemical products
6728	Selenic acid, dicesium salt	10326-29-1	Contains (regardless of intentional or impurities)	chemical products
6729	Copper, bis(N5-carbamoyl-L-ornithinato)-	10327-05-6	Intentional addition / 1,000ppm	chemical products
6730	2-Octene, 8-bromo-2,6-dimethyl-, (R)-	10340-84-8	1,000ppm	chemical products
6731	7-Nonenenitrile, 4,8-dimethyl-, (R)-	10340-85-9	Intentional addition	chemical products
6732	Chromium, [2-hydroxy-5-nitro-3-[[2-oxo-1-[(phenylamino)carbonyl]propyl]azo]benzenesulfonato(3-)]-	10343-55-2	1,000ppm	chemical products
6733	Chromate(1-), hydroxy[2-hydroxy-5-nitro-3-[[2-oxo-1-[(phenylamino)carbonyl]propyl]azo]benzenesulfonato(3-)]-, sodium	10343-58-5	Contains (regardless of intentional or impurities)	chemical products
6734	Iron dinitocinate	10361-13-4	1%	chemical products
6735	Barium chloride (BaCl2)	10361-37-2	Contains (regardless of intentional or impurities)	chemical products
6736	Nitric acid, bismuth(3+) salt	10361-44-1	Contains (regardless of intentional or impurities)	chemical products
6737	Yttrium chloride (YCl3)	10361-92-9	1%	chemical products
6738	Nitric acid, yttrium(3+) salt	10361-93-0	1%	chemical products
6739	Orthoboric acid, zinc salt	10361-94-1	Intentional addition / 1%	chemical products
6740	Zinc chlorate	10361-95-2	Contains (regardless of intentional or impurities)	chemical products
6741	Boric acid, B-(3-methoxyphenyl)-	10365-98-7	1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
6742	Magnesium permanganate	10377-62-5	Contains (regardless of intentional or impurities)	chemical products
6743	Nitric acid, manganese(2+) salt	10377-66-9	Contains (regardless of intentional or impurities)	chemical products
6744	Ethanol, 2-amino-, monoester with boric acid (H3BO3)	10377-81-8	1%	chemical products
6745	Zirconium sodium lactate	10377-98-7	Contains (regardless of intentional or impurities)	chemical products
6746	1-Butene, 1-bromo-2-methyl-	10379-48-3	1,000ppm	chemical products
6747	Zinc dioxometaborate	10380-06-0	Intentional addition / 1%	chemical products
6748	Copper(II) 8-hydroxyquinoline	10380-28-6	Intentional addition / 100ppm	chemical products
6749	Chromate(1-), bis[2,4-dihydro-4-[[2-hydroxy-4(or 5)-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-], hydrogen	10380-30-0	Contains (regardless of intentional or impurities)	chemical products
6750	Barium uranium oxide	10380-31-1	Contains (regardless of intentional or impurities)	chemical products
6751	Phosphoric acid, nickel(2+) salt (2:3)	10381-36-9	Contains (regardless of intentional or impurities)	chemical products
6752	Benzenamine, N-butyl-4-methyl-	10387-24-3	Intentional addition / 25%	chemical products
6753	Chloroborane	10388-28-0	1%	chemical products
6754	Cobalt sulfate	10393-49-4	Intentional addition / 1%	chemical products
6755	9-Octadecenoic acid (2-), copper salt	10402-16-1	Intentional addition / 1,000ppm	chemical products
6756	Hexanenitrile, 5-oxo-	10412-98-3	Intentional addition	chemical products
6757	Nitric acid, mercury(1+) salt (1:1)	10415-75-5	Contains (regardless of intentional or impurities)	chemical products
6758	Ferric nitrate	10421-48-4	Contains (regardless of intentional or impurities)	chemical products
6759	Methanaminium, N,N,N-trimethyl-, hydroxide, pentahydrate	10424-85-4	Intentional addition / 25%	chemical products
6760	Distannoxane, 1,1,3,3-tetrabutyl-, 1,3-dichloro-	10428-19-0	Contains (regardless of intentional or impurities)	chemical products
6761	Potassium selenite	10431-47-7	Contains (regardless of intentional or impurities)	chemical products
6762	Antimony trioxide	10433-06-4	Contains (regardless of intentional or impurities)	chemical products
6763	3-(Oxiranylmethoxy)propanenitrile	10433-39-3	Contains (regardless of intentional or impurities)	chemical products
6764	1,1,2,3-Tetrachloropropene	10436-39-2	1,000ppm	chemical products
6765	Benzenamine, 4-methyl-N-(1-methylethyl)-	10436-75-6	Intentional addition	chemical products
6766	1-Butanaminium, N,N,N-tributyl-, cyanide	10442-39-4	Contains (regardless of intentional or impurities)	chemical products
6767	Aluminum, trihexacosyl-	10449-71-5	1,000ppm	chemical products
6768	Iron di(acetate) hydroxide	10450-55-2	1%	chemical products
6769	9-Octadecenoic acid (9Z)-, cadmium salt (2:1)	10468-30-1	Contains (regardless of intentional or impurities)	chemical products
6770	1,1'-Biphenyl, 2-cyclohexyl-	10470-01-6	1%	chemical products
6771	Butanedioic acid, 2,3-dihydroxy- [R-(RR)]-, nickel(2+) salt (1:1)	10471-42-8	Contains (regardless of intentional or impurities)	chemical products
6772	Butanedioic acid, 2,3-dihydroxy-, nickel(2+) salt (1:1), (R,S,S*)-	10471-47-3	Contains (regardless of intentional or impurities)	chemical products
6773	Strychnine arsenate	10476-82-1	Contains (regardless of intentional or impurities)	chemical products
6774	Strontium iodide (SrI2)	10476-86-5	1%	chemical products
6775	Strychnine dimethylarsinate	10476-87-6	Contains (regardless of intentional or impurities)	chemical products
6776	Ethyl 4-(chlorosulfonyl)benzoate	10486-51-8	Contains (regardless of intentional or impurities)	chemical products
6777	2(3H)-Benzoselenazolethione	10486-58-5	Contains (regardless of intentional or impurities)	chemical products
6778	Rhodium sulfate	10489-46-0	Contains (regardless of intentional or impurities)	chemical products
6779	1,1'-[Ethylenebis(oxyethylene)]dipyridinium diperchlorate	10493-34-2	1,000ppm	chemical products
6780	Methyldiphenylsulfonium tetrafluoroborate(1-)	10504-60-6	1%	chemical products
6781	N-tert-Butyl-5-methylisoxazolium perchlorate	10513-45-8	1,000ppm	chemical products
6782	Tritungsten dyttrium dodecaoxide	10527-41-0	1%	chemical products
6783	Cyanomethyl benzenesulphonate	10531-13-2	Intentional addition	chemical products
6784	(OC-6-12)-Tetraamminebis(nitrito-N)cobalt(1+) chloride	10534-83-5	1%	chemical products
6785	(OC-6-11)-Hexaamminecobalt tribromide	10534-85-7	1%	chemical products
6786	Cobalt(3+), hexaammine-, (OC-6-11)-, trinitrate	10534-86-8	Intentional addition / 1,000ppm	chemical products
6787	Cobalt(3+), hexaammine-, trichloride, (OC-6-11)-	10534-89-1	Intentional addition / 1,000ppm	chemical products
6788	o-Toluidine, N-methyl-, hydrochloride	10541-29-4	Intentional addition / 25%	chemical products
6789	Barium bromide (BaBr2)	10553-31-8	Contains (regardless of intentional or impurities)	chemical products
6790	Boric acid (HBO2), sodium salt, tetrahydrate	10555-76-7	1%	chemical products
6791	Iodic acid (HIO3), barium salt	10567-69-8	Contains (regardless of intentional or impurities)	chemical products
6792	Heptane, 1,2-dichloro-	10575-87-8	1,000ppm	chemical products
6793	Heptane, 2,3-dichloro-	10575-89-7	1,000ppm	chemical products
6794	Ammonium titanium oxalate, monohydrate	10580-93-7	Intentional addition	chemical products
6795	Vanadium dichloride	10580-52-6	Intentional addition / 1%	chemical products
6796	1,2-Ethanedithiol compound with trifluoroborane	10581-11-0	1%	chemical products
6797	8-Oxo-3,5-dithia-4-stannatetradeconoic acid, 4,4-dibutyl-10-ethyl-7-oxo-, 2-ethylhexyl ester	10584-98-2	Contains (regardless of intentional or impurities)	chemical products
6798	N-Nitrosomethylamine	10595-95-6	Contains (regardless of intentional or impurities)	chemical products
6799	Tributyl(octanoyloxy)stannane	10603-83-1	Contains (regardless of intentional or impurities)	chemical products
6800	Carbazepim	10605-21-7	Contains (regardless of intentional or impurities)	chemical products
6801	Boron tribromide	10694-33-4	1%	chemical products
6802	Sodium cobalt chlorophyllin	11005-93-9	Intentional addition / 1%	chemical products
6803	Cuprate(3-), [18-carboxy-20-(carboxymethyl)-8-ethenyl-13-ethyl-2,3-dihydro-3,7,12,17-tetramethyl-21H,23H-porphine-2-propanoato(5-)-N21,N22,N23,N24]-, trisodium, [SP-4-2-(2S-trans)]-	11006-34-1	Intentional addition / 1,000ppm	chemical products
6804	Lasalacid	11054-70-9	Intentional addition	chemical products
6805	[N,N-Bis(2-bis(carboxymethyl)amino)ethyl]glycinate(5-)]cuprate(3-)	11065-66-0	Intentional addition / 1,000ppm	chemical products
6806	Trisodium [N,N-bis(2-bis(carboxymethyl)amino)ethyl]glycinate(5-)]manganate(3-)	11065-74-0	Contains (regardless of intentional or impurities)	chemical products
6807	Phenol, isonyl-	11066-49-2	Intentional addition / 1%	chemical products
6808	Nickel-based cobalt alloy	11068-91-0	Contains (regardless of intentional or impurities)	chemical products
6809	Dichlorobutene	11069-19-5	1,000ppm	chemical products
6810	1,3-Isobenzofurandione, tetrahydromethyl-	11070-44-3	Contains (regardless of intentional or impurities)	chemical products
6811	Copper boride (CuB)	11070-95-4	Intentional addition / 1,000ppm	chemical products
6812	Cobalt boride (CoB2)	11070-96-5	Intentional addition / 1%	chemical products
6813	Antimonate(2-), bis[mu-[[2,3-dihydroxybutanedioato(4-)-O1,O2,O3,O4]]di-], dipotassium, stereoisomer	11071-15-1	Contains (regardless of intentional or impurities)	chemical products
6814	Nickel boride (Ni7B3)	11071-48-0	Contains (regardless of intentional or impurities)	chemical products
6815	Molybdenum silicide (Mo5Si2)	11074-63-8	1%	chemical products
6816	Cobaltocenium, (T-4)-tetrachlorocobaltate(2-)(2:1)	11077-19-3	Intentional addition / 1,000ppm	chemical products
6817	Tetrakis(acetato)bis(cyclopentadienyl)divanadium(III)	11077-92-2	Intentional addition / 1%	chemical products
6818	Barium tin oxide (Ba2SnO4)	11078-62-9	Intentional addition	chemical products
6819	Barium zirconium oxide (Ba3Zr2O7)	11078-65-2	Intentional addition	chemical products
6820	Ethylendiaminetetraacetic acid disodium nickel(II) salt hydrate	11079-07-5	Contains (regardless of intentional or impurities)	chemical products
6821	Molybdenum boride (MoB5)	11081-84-8	Contains (regardless of intentional or impurities)	chemical products
6822	Molybdenum carbide (Mo2C3)	11082-09-0	1%	chemical products
6823	Stibine, fluoroxy-	11083-22-0	Contains (regardless of intentional or impurities)	chemical products
6824	Calcium compound with copper (1:5)	11091-65-9	Intentional addition / 1,000ppm	chemical products
6825	Barium oxide silicate (Ba5O(Si2O5)4)	11092-02-7	Intentional addition / 1,000ppm	chemical products
6826	6-Thiadecaborate(1-), dodecahydro-, cesium	11092-86-7	1%	chemical products
6827	Ferrate(2-), difluoro(phosphato(3-)-O)-, ammonium hydrogen	11095-66-2	1%	chemical products
6828	Aroclor 1260	11096-82-5	Intentional addition / 1,000ppm	chemical products
6829	Manganese borate	11097-89-5	Contains (regardless of intentional or impurities)	chemical products
6830	Ammonium molybdenum oxide	11098-84-3	1%	chemical products
6831	Molybdenum oxides	11098-99-0	1%	chemical products
6832	Nickel oxides	11099-02-8	Contains (regardless of intentional or impurities)	chemical products
6833	Vanadium oxides	11099-11-9	Intentional addition / 1%	chemical products
6834	Yttrium oxide sulfide	11099-13-1	1%	chemical products
6835	Boron alloy, nonbase, B,Ni	11099-25-5	1%	chemical products
6836	Cobaltate(1-), bis[4-[[[15-chloro-2-(hydroxy-kappa,O)phenyl]azo-kappa,N2]phenyl(methyl)azo-kappa,N1]benzenesulfonamidato(2-)-], hydrogen	11103-91-6	Intentional addition / 1%	chemical products
6837	Bismuth molybdenum oxide	11104-44-2	Intentional addition / 1%	chemical products
6838	Cobalt oxides	11104-61-3	Intentional addition / 1%	chemical products
6839	Chromium copper oxide	11104-85-7	Contains (regardless of intentional or impurities)	chemical products
6840	Molybdenum silicide	11104-85-1	1%	chemical products
6841	Molybdenum hydroxide oxide phosphate	11104-88-4	1%	chemical products
6842	Silicomolybdic acid	11104-89-5	1%	chemical products
6843	Sodium zirconium oxide sulfate	11105-03-6	Contains (regardless of intentional or impurities)	chemical products
6844	Sodium vanadate	11105-06-9	Intentional addition / 1%	chemical products
6845	Tungsten oxide (WO3), hydrate	11105-11-6	1%	chemical products
6846	Vanadium chloride	11105-12-7	Intentional addition / 1%	chemical products
6847	Zirconium hydride	11105-16-1	Contains (regardless of intentional or impurities)	chemical products
6848	High nickel alloys	11105-19-4	Contains (regardless of intentional or impurities)	chemical products
6849	Nickel alloy, base, Ni 80,Cr 20	11106-97-1	Contains (regardless of intentional or impurities)	chemical products
6850	Tungsten carbide, mixed with cobalt (85%15%)	11107-01-0	1%	chemical products
6851	Vanadium yttrium oxide	11108-03-5	Intentional addition / 1%	chemical products
6852	Cobalt alloy, base, Co,Fe (ferrocobalt)	11108-68-2	Intentional addition / 1%	chemical products
6853	Niobium alloy, base, Nb 50-70, Fe 20-48, Ta 2-7, Si 0-4, Al 0-2, C 0-0.3, Sn 0-0.2 (ASTM A550)	11108-69-3	Contains (regardless of intentional or impurities)	chemical products
6854	Silicon alloy, base, Si,Fe,Zr (ferrozirconium)	11108-72-8	Contains (regardless of intentional or impurities)	chemical products
6855	Sodium amalgam	11110-52-4	Contains (regardless of intentional or impurities)	chemical products
6856	Sodium antimonate	11112-10-0	Contains (regardless of intentional or impurities)	chemical products
6857	Cadmium selenide sulphide	11112-63-3	Contains (regardless of intentional or impurities)	chemical products
6858	Cobalt fluoride	11113-57-8	Contains (regardless of intentional or impurities)	chemical products
6859	Copper fluoride	11113-59-0	Contains (regardless of intentional or impurities)	chemical products
6860	Lead chromate silicate	11113-70-5	Contains (regardless of intentional or impurities)	chemical products
6861	Manganese fluoride	11113-71-6	Contains (regardless of intentional or impurities)	chemical products
6862	Nickel hydroxide	11113-74-9	Contains (regardless of intentional or impurities)	chemical products
6863	Nickel sulfides	11113-75-0	Contains (regardless of intentional or impurities)	chemical products
6864	Tin vanadate	11113-92-1	Intentional addition / 1,000ppm	chemical products
6865	Chromium alloy, base, Cr,C,Fe,Ni	11114-46-8	1,000ppm	chemical products
6866	Cobalt chromium alloy	11114-92-4	Intentional addition / 1,000ppm	chemical products
6867	Ammonium vanadate	11115-67-6	Intentional addition / 1%	chemical products
6868	Chromic acid	11115-74-5	Contains (regardless of intentional or impurities)	chemical products
6869	Copper sulfide	11115-78-9	Intentional addition / 1,000ppm	chemical products
6870	Iron manganese oxide	11115-91-6	Contains (regardless of intentional or impurities)	chemical products
6871	Iron molybdenum oxide	11115-97-2	1%	chemical products
6872	Nickel selenide	11115-99-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
6873	Barium titanium oxide (Ba4Ti13O30)	11116-82-8	Intentional addition	chemical products
6874	Gold chloride	11118-27-7	Intentional addition	chemical products
6875	Chromium oxide	11118-57-3	Contains (regardless of intentional or impurities)	chemical products
6876	Ferrocene, 1,1'-(1,1,3,3-tetramethyl-1,3-disiloxanedyl)bis(3,1-propanediyliminocarbonyl)bis-	11120-06-2	1%	chemical products
6877	Tungstate (W12(OH)2O4010-), decaammonium	11120-25-5	Intentional addition / 1%	chemical products
6878	Telluric acid	11120-48-2	Contains (regardless of intentional or impurities)	chemical products
6879	Boric acid, aluminum salt	11121-16-7	1%	chemical products
6880	Molybdenum alloy, base, Mo 55-70, Fe 25-45, C 0-2.5, Si 0-1.5, Cu 0-1, S 0-0.2, P 0-0.1 (ASTM A132)	11121-95-2	Contains (regardless of intentional or impurities)	chemical products
6881	High nickel alloys	11121-96-3	Contains (regardless of intentional or impurities)	chemical products
6882	Silicon alloy, base, Si, Ca, Mn	11125-27-2	Contains (regardless of intentional or impurities)	chemical products
6883	Silicic acid, zinc salt	11126-29-7	Intentional addition / 25%	chemical products
6884	Boron potassium oxide (B3K08)	11128-29-3	1%	chemical products
6885	Ammonium borate	11128-98-6	1%	chemical products
6886	Barium aluminate	11129-08-1	Intentional addition / 1%	chemical products
6887	Cadmium zinc sulfide	11129-14-9	Contains (regardless of intentional or impurities)	chemical products
6888	Calcium zirconium oxide	11129-15-0	Contains (regardless of intentional or impurities)	chemical products
6889	Copper bromide	11129-27-4	Intentional addition / 1,000ppm	chemical products
6890	Gadolinium yttrium oxide	11129-32-1	1%	chemical products
6891	Hafnium carbide	11129-37-6	1%	chemical products
6892	Manganese oxygen(-2) anion	11129-60-5	Contains (regardless of intentional or impurities)	chemical products
6893	Silicic acid, manganese salt	11129-61-6	Contains (regardless of intentional or impurities)	chemical products
6894	Vanadium carbide	11130-21-5	Intentional addition / 1%	chemical products
6895	Vanadium sulfide	11130-24-8	Intentional addition / 1%	chemical products
6896	Yttrium oxide	11130-29-3	1%	chemical products
6897	Nickel potassium fluoride	11132-10-8	Contains (regardless of intentional or impurities)	chemical products
6898	Manganese nitride (MnN4), (T-4)-	11132-35-7	1%	chemical products
6899	Manganese chloride	11132-78-8	Contains (regardless of intentional or impurities)	chemical products
6900	Iron alloy, base, Fe, Ni	11133-76-9	Contains (regardless of intentional or impurities)	chemical products
6901	Beryllium-copper alloy	11133-98-5	Contains (regardless of intentional or impurities)	chemical products
6902	Potassium-sodium alloy	11135-81-2	Contains (regardless of intentional or impurities)	chemical products
6903	Barium iron oxide	11138-11-7	Intentional addition / 1,000ppm	chemical products
6904	Cobalt, compound with gadolinium (7.2)	11139-24-5	Intentional addition / 1,000ppm	chemical products
6905	Tantalum aluminum oxide	11139-79-0	1%	chemical products
6906	Zirconium-nickel alloy	11146-73-9	Contains (regardless of intentional or impurities)	chemical products
6907	Iron alloy, nonbase (Fe, V)	11147-86-7	Intentional addition / 1%	chemical products
6908	Cadmium calcium copper zinc sulfate chromate	12001-20-6	Contains (regardless of intentional or impurities)	chemical products
6909	Asbestos, crocidolite	12001-28-4	Contains (regardless of intentional or impurities)	chemical products
6910	Asbestos, chrysotile	12001-29-5	Contains (regardless of intentional or impurities)	chemical products
6911	Dipotassium bis[mu-(tartrato(4-)-O1,O2,O3,O4)]diborate(2-), stereoisomer	12001-68-2	1%	chemical products
6912	Antimony sodium gluconate	12001-86-4	Contains (regardless of intentional or impurities)	chemical products
6913	Bis(1,2,3,4,5,6-eta-1-isopropylbenzene)chromium	12001-89-7	1,000ppm	chemical products
6914	C.I. Pigment Green 18	12001-99-9	1,000ppm	chemical products
6915	Copper acetoarsenite	12002-03-8	Contains (regardless of intentional or impurities)	chemical products
6916	Trichlorobenzenes	12002-48-1	Intentional addition / 1,000ppm	chemical products
6917	Silver gallium selenide	12002-67-4	Contains (regardless of intentional or impurities)	chemical products
6918	Silver selenide (Ag2Se)	12002-86-7	Contains (regardless of intentional or impurities)	chemical products
6919	Silver telluride (Ag2Te)	12002-99-2	Contains (regardless of intentional or impurities)	chemical products
6920	Aluminum ferrosilicon	12003-41-7	Contains (regardless of intentional or impurities)	chemical products
6921	Aluminum, compound with manganese (1:1)	12003-70-2	Contains (regardless of intentional or impurities)	chemical products
6922	Aluminum, compound with molybdenum (1:3)	12003-72-4	Contains (regardless of intentional or impurities)	chemical products
6923	Aluminum, compound with nickel (1:1)	12003-78-0	Contains (regardless of intentional or impurities)	chemical products
6924	Aluminum yttrium trioxide	12003-86-0	1%	chemical products
6925	Aluminate (AlO21-), barium (2:1)	12004-04-5	Contains (regardless of intentional or impurities)	chemical products
6926	Aluminate (AlO32-), barium (2:3)	12004-05-6	Contains (regardless of intentional or impurities)	chemical products
6927	Aluminum, compound with copper (2:1)	12004-15-8	Intentional addition / 1,000ppm	chemical products
6928	Aluminum nickel oxide (Al2NiO4)	12004-35-2	Contains (regardless of intentional or impurities)	chemical products
6929	Aluminum, compound with nickel (3:1)	12004-71-6	Contains (regardless of intentional or impurities)	chemical products
6930	Aluminum, compound with zirconium (3:1)	12004-83-0	Contains (regardless of intentional or impurities)	chemical products
6931	Aluminum yttrium oxide (Al5Y3O12)	12005-21-9	1%	chemical products
6932	Aluminum borate oxide	12005-61-7	1%	chemical products
6933	Boron arsenide (BAs)	12005-69-5	Contains (regardless of intentional or impurities)	chemical products
6934	Boron arsenide (B6As)	12005-70-8	Contains (regardless of intentional or impurities)	chemical products
6935	Copper arsenide (Cu3As)	12005-75-3	Contains (regardless of intentional or impurities)	chemical products
6936	Dysprosium arsenide (Dy3As)	12005-81-1	Contains (regardless of intentional or impurities)	chemical products
6937	Silver(I) hexafluoroarsenate	12005-82-2	Intentional addition / 1,000ppm	chemical products
6938	Sodium hexafluoroarsenate	12005-86-6	Contains (regardless of intentional or impurities)	chemical products
6939	Iron arsenide (Fe2As)	12005-88-8	Contains (regardless of intentional or impurities)	chemical products
6940	Gadolinium arsenide (GdAs)	12005-89-9	Contains (regardless of intentional or impurities)	chemical products
6941	Holmium arsenide (HoAs)	12005-92-4	Contains (regardless of intentional or impurities)	chemical products
6942	Lutetium arsenide (LuAs)	12005-94-6	Contains (regardless of intentional or impurities)	chemical products
6943	Manganese arsenide (MnAs)	12005-95-7	Contains (regardless of intentional or impurities)	chemical products
6944	Manganese arsenide (Mn2As)	12005-96-8	Contains (regardless of intentional or impurities)	chemical products
6945	Arsenic(II) oxide	12005-99-1	Contains (regardless of intentional or impurities)	chemical products
6946	Arsenic selenide (AsSe)	12006-05-2	Contains (regardless of intentional or impurities)	chemical products
6947	Arsenic selenide (AsSe4)	12006-06-3	Contains (regardless of intentional or impurities)	chemical products
6948	Terbium arsenide (TbAs)	12006-08-5	Contains (regardless of intentional or impurities)	chemical products
6949	Thallium arsenide (TlAs)	12006-09-6	Contains (regardless of intentional or impurities)	chemical products
6950	Thulium arsenide (TmAs)	12006-10-9	Contains (regardless of intentional or impurities)	chemical products
6951	Ytterbium arsenide (YbAs)	12006-12-1	Contains (regardless of intentional or impurities)	chemical products
6952	Cadmium arsenide (Cd3As2)	12006-15-4	Contains (regardless of intentional or impurities)	chemical products
6953	Iron arsenide (FeAs2)	12006-21-2	Contains (regardless of intentional or impurities)	chemical products
6954	Zinc arsenide (Zn3As2)	12006-40-5	Contains (regardless of intentional or impurities)	chemical products
6955	Cobalt boride (CoB)	12006-77-8	Intentional addition / 1%	chemical products
6956	Cobalt boride (Co3B)	12006-78-9	Intentional addition / 100ppm	chemical products
6957	Chromium boride (CrB)	12006-79-0	1,000ppm	chemical products
6958	Chromium boride (Cr2B)	12006-80-3	1,000ppm	chemical products
6959	Iron boride (FeB)	12006-84-7	1%	chemical products
6960	Iron boride (Fe2B)	12006-85-8	1%	chemical products
6961	Iron boride	12006-86-9	1%	chemical products
6962	Molybdenum boride (MoB)	12006-98-3	Contains (regardless of intentional or impurities)	chemical products
6963	Molybdenum boride (Mo2B)	12006-99-4	Contains (regardless of intentional or impurities)	chemical products
6964	Nickel boride	12007-00-0	Contains (regardless of intentional or impurities)	chemical products
6965	Dinickel boride	12007-01-1	Contains (regardless of intentional or impurities)	chemical products
6966	Trinickel boride	12007-02-2	Contains (regardless of intentional or impurities)	chemical products
6967	Tantalum boride (TaB)	12007-07-7	1%	chemical products
6968	Titanium monoboride	12007-08-8	1%	chemical products
6969	Tungsten boride (WB)	12007-09-9	1%	chemical products
6970	Tungsten boride (W2B)	12007-10-2	1%	chemical products
6971	Chromium boride (CrB2)	12007-16-8	Contains (regardless of intentional or impurities)	chemical products
6972	Iron boride (FeB2)	12007-18-0	1%	chemical products
6973	Hafnium boride (HfB2)	12007-23-7	1%	chemical products
6974	Lanthanum boride (LaB2)	12007-24-8	1%	chemical products
6975	Magnesium boride (MgB2)	12007-25-9	1%	chemical products
6976	Molybdenum boride (MoB2)	12007-27-1	Contains (regardless of intentional or impurities)	chemical products
6977	Molybdenum boride (Mo3B2)	12007-28-2	Contains (regardless of intentional or impurities)	chemical products
6978	Niobium boride (NbB2)	12007-29-3	1%	chemical products
6979	Diboron trisulfide	12007-33-9	1%	chemical products
6980	Scandium boride (ScB2)	12007-34-0	1%	chemical products
6981	Tantalum boride (TaB2)	12007-35-1	1%	chemical products
6982	Uranium diboride	12007-36-2	Contains (regardless of intentional or impurities)	chemical products
6983	Vanadium boride (VB2)	12007-37-3	Intentional addition / 1%	chemical products
6984	Chromium boride (Cr5B3)	12007-38-4	1,000ppm	chemical products
6985	Boron potassium oxide (B3K05)	12007-40-8	1%	chemical products
6986	Boron lithium oxide (B3LiO5)	12007-41-9	1%	chemical products
6987	Boron sodium oxide (B3NaO5)	12007-42-0	1%	chemical products
6988	Barium tetraborate	12007-55-5	Intentional addition	chemical products
6989	Boron calcium oxide (B4CaO7)	12007-56-6	1%	chemical products
6990	Ammonium boron hydroxide oxide ((NH4)B4(OH)O6)	12007-57-7	1%	chemical products
6991	Ammonium boron oxide ((NH4)2B4O7)	12007-58-8	1%	chemical products
6992	Boron lithium oxide (B4Li2O7)	12007-60-2	1%	chemical products
6993	Boron lithium oxide (B4Li2O7) hydrate	12007-61-3	1%	chemical products
6994	Boron magnesium oxide (B4MgO7)	12007-62-4	1%	chemical products
6995	Boron strontium oxide (B4SrO7)	12007-66-8	1%	chemical products
6996	Zinc tetraborate	12007-67-9	Intentional addition / 1%	chemical products
6997	Lanthanum boride (LaB4)	12007-73-7	1%	chemical products
6998	Boron silicide (B4Si)	12007-81-7	1%	chemical products
6999	Thorium boride (ThB4), (T-4)-	12007-83-9	1%	chemical products
7000	Uranium tetraboride	12007-84-0	Contains (regardless of intentional or impurities)	chemical products
7001	Chromium boride (Cr3B5)	12007-88-4	1,000ppm	chemical products
7002	Ammonium boron oxide ((NH4)B5O8)	12007-89-5	1%	chemical products
7003	Boron lithium oxide (B5LiO8)	12007-91-9	1%	chemical products
7004	Sodium pentaborate	12007-92-0	1%	chemical products
7005	Molybdenum boride (Mo2B5)	12007-97-5	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
7006	Tungsten boride (W2B5)	12007-98-6	1%	chemical products
7007	Calcium boride (CaB6) (OC-6-11)-	12007-99-7	1%	chemical products
7008	Cerium boride (CeB6) (OC-6-11)-	12008-02-5	1%	chemical products
7009	Dysprosium boride (DyB6) (OC-6-11)-	12008-04-7	1%	chemical products
7010	Europium boride (EuB6) (OC-6-11)-	12008-05-8	1%	chemical products
7011	Gadolinium boride (GdB6) (OC-6-11)-	12008-06-9	1%	chemical products
7012	Lanthanum boride (LaB6) (OC-6-11)-	12008-21-8	1%	chemical products
7013	Neodymium boride (NdB6) (OC-6-11)-	12008-23-0	1%	chemical products
7014	Tetrazine hexaborateoxide	12008-25-2	Intentional addition / 1%	chemical products
7015	Praseodymium boride (PrB6) (OC-6-11)-	12008-27-4	1%	chemical products
7016	Boron silicide (B6Si)	12008-29-6	1%	chemical products
7017	Samarium boride (SmB6) (OC-6-11)-	12008-30-9	1%	chemical products
7018	Terbium boride (TbB6) (OC-6-11)-	12008-31-0	1%	chemical products
7019	Yttrium boride (YB6) (OC-6-11)-	12008-32-1	1%	chemical products
7020	Ytterbium boride (YbB6) (OC-6-11)-	12008-33-2	1%	chemical products
7021	Boron lithium oxide (BBL2O13)	12008-40-1	1%	chemical products
7022	Dodecaborate(2-), dodecalhydro-, dicesium	12008-75-2	1%	chemical products
7023	Dodecaborate(2-), dodecalhydro-, disodium	12008-78-5	1%	chemical products
7024	Boron phosphide (B13P2)	12008-82-1	Intentional addition / 1%	chemical products
7025	Barium hydroxide (Ba(OH)2)	12009-08-4	Intentional addition	chemical products
7026	Barium niobium oxide (BaNb2O6)	12009-14-2	Contains (regardless of intentional or impurities)	chemical products
7027	Barium ruthenium trioxide	12009-17-5	Contains (regardless of intentional or impurities)	chemical products
7028	Barium tin oxide (BaSnO3)	12009-18-6	Contains (regardless of intentional or impurities)	chemical products
7029	Barium zirconate	12009-21-1	Contains (regardless of intentional or impurities)	chemical products
7030	Barium titanium oxide (BaTi2O5)	12009-27-7	Intentional addition	chemical products
7031	Barium titanium oxide (BaTi3O7)	12009-29-9	Intentional addition	chemical products
7032	Barium tetratitanate	12009-31-3	Intentional addition	chemical products
7033	Barium silicide	12009-35-7	Intentional addition	chemical products
7034	Barium telluride (BaTe)	12009-36-8	Contains (regardless of intentional or impurities)	chemical products
7035	Barium titanium oxide (Ba2TiO4)	12009-63-1	Intentional addition	chemical products
7036	Beryllium oxide (Be2O)	12009-99-3	Contains (regardless of intentional or impurities)	chemical products
7037	Niobium compound with beryllium (1:12)	12010-12-7	Contains (regardless of intentional or impurities)	chemical products
7038	Bismuth compound with indium (1:1)	12010-46-7	Intentional addition / 1%	chemical products
7039	Bismuth compound with indium (1:2)	12010-47-8	Intentional addition / 1%	chemical products
7040	Bismuth compound with manganese (1:1)	12010-50-3	Contains (regardless of intentional or impurities)	chemical products
7041	Bismuth tin oxide (Bi2Sn3O9)	12010-67-2	Contains (regardless of intentional or impurities)	chemical products
7042	Boron carbide	12011-54-0	1%	chemical products
7043	Nickel, [mu.-[carbonato(2-)-O,O']dihydroxydi-, hydrate	12011-78-8	Contains (regardless of intentional or impurities)	chemical products
7044	Molybdenum carbide (MoC)	12011-97-1	Contains (regardless of intentional or impurities)	chemical products
7045	Trimolybdenum carbide	12011-98-2	Contains (regardless of intentional or impurities)	chemical products
7046	Chromium carbide (Cr3C2)	12012-35-0	1,000ppm	chemical products
7047	Platinate(1-), trichloro,eta.2-ethene-, potassium	12012-50-9	Contains (regardless of intentional or impurities)	chemical products
7048	Hafnium tetrantalum pentacarbide	12012-58-7	1%	chemical products
7049	Cobalt disulfide	12013-10-4	Intentional addition / 1,000ppm	chemical products
7050	Copper hydroxide sulfate (Cu3(OH)4(SO4))	12013-15-9	Intentional addition / 1,000ppm	chemical products
7051	Magnesium molybdenum oxide	12013-21-7	1%	chemical products
7052	Calcium dichromium tetraoxide	12013-31-9	Contains (regardless of intentional or impurities)	chemical products
7053	Ferrate (FeO21-), calcium (2:1)	12013-33-1	1%	chemical products
7054	Calcium tin oxide (CaSnO3)	12013-46-6	Contains (regardless of intentional or impurities)	chemical products
7055	Calcium zirconium oxide (CaZrO3)	12013-47-7	Contains (regardless of intentional or impurities)	chemical products
7056	Calcium telluride (CaTe)	12013-57-9	Contains (regardless of intentional or impurities)	chemical products
7057	Cadmium titanium oxide (CdTiO3)	12014-14-1	Contains (regardless of intentional or impurities)	chemical products
7058	Antimony phosphide (Cd3P2)	12014-28-7	Contains (regardless of intentional or impurities)	chemical products
7059	Antimony compound with cadmium (2:3)	12014-29-8	Contains (regardless of intentional or impurities)	chemical products
7060	Cerium selenide (Ce2Se3)	12014-94-7	Contains (regardless of intentional or impurities)	chemical products
7061	Cerium telluride (Ce2Te3)	12014-97-0	Contains (regardless of intentional or impurities)	chemical products
7062	Cobalt sulfide (Co3S4)	12015-75-7	Intentional addition / 1%	chemical products
7063	Chromium cobalt oxide (Cr2CoO4)	12016-89-2	Contains (regardless of intentional or impurities)	chemical products
7064	Cobalt hydroxide oxide (Co(OH)O)	12016-80-7	Intentional addition / 100ppm	chemical products
7065	Cobalt oxide (CoO2)	12017-00-4	Intentional addition / 1%	chemical products
7066	Cobalt titanium oxide (CoTiO3)	12017-01-5	Intentional addition / 1,000ppm	chemical products
7067	Cobalt silicide (CoSi2)	12017-12-8	Intentional addition / 100ppm	chemical products
7068	Cobalt telluride (CoTe)	12017-13-9	Contains (regardless of intentional or impurities)	chemical products
7069	Cobalt titanium oxide (Co2TiO4)	12017-38-8	Intentional addition / 100ppm	chemical products
7070	Cobalt compound with samarium (2:1)	12017-43-5	Intentional addition / 1,000ppm	chemical products
7071	Cobalt compound with gadolinium (3:1)	12017-50-4	Intentional addition / 1,000ppm	chemical products
7072	Cobalt compound with gadolinium (5:1)	12017-61-7	Intentional addition / 1,000ppm	chemical products
7073	Cobalt compound with neodymium (5:1)	12017-65-1	Intentional addition / 1,000ppm	chemical products
7074	Cobalt compound with praseodymium (5:1)	12017-67-3	Intentional addition / 1,000ppm	chemical products
7075	Cobalt compound with samarium (5:1)	12017-68-4	Intentional addition / 1,000ppm	chemical products
7076	Cobalt compound with yttrium (5:1)	12017-71-9	Intentional addition / 1,000ppm	chemical products
7077	Cobalt sulfide (Co9S8)	12017-76-4	Intentional addition / 1%	chemical products
7078	Chromium copper dioxide	12017-79-7	Contains (regardless of intentional or impurities)	chemical products
7079	Chromium lanthanum oxide (CrLaO3)	12017-94-6	Contains (regardless of intentional or impurities)	chemical products
7080	Chromium oxide (CrO2)	12018-01-8	Intentional addition / 1,000ppm	chemical products
7081	Chromium silicide	12018-08-5	1,000ppm	chemical products
7082	Chromium silicide (CrSi2)	12018-09-6	1,000ppm	chemical products
7083	Chromium copper oxide (Cr2CuO4)	12018-10-9	Intentional addition / 1,000ppm	chemical products
7084	Chromium compound with niobium (2:1)	12018-17-6	1,000ppm	chemical products
7085	Dichromium nickel tetraoxide	12018-18-7	Contains (regardless of intentional or impurities)	chemical products
7086	Chromium zinc oxide	12018-19-8	Contains (regardless of intentional or impurities)	chemical products
7087	Chromium(III) sulfide	12018-22-3	Contains (regardless of intentional or impurities)	chemical products
7088	Chromium silicide (Cr3Si)	12018-36-9	1,000ppm	chemical products
7089	Antimony compound with cesium (1:3)	12018-68-7	Contains (regardless of intentional or impurities)	chemical products
7090	Copper gallium selenide (CuGaSe2)	12018-83-6	Contains (regardless of intentional or impurities)	chemical products
7091	Copper indium sulfide	12018-94-9	1%	chemical products
7092	Copper indium diselenide	12018-95-0	Contains (regardless of intentional or impurities)	chemical products
7093	Copper indium telluride	12018-96-1	1%	chemical products
7094	Copper titanium oxide (CuTiO3)	12019-08-8	Intentional addition / 1,000ppm	chemical products
7095	Copper diphosphide	12019-11-3	Intentional addition / 1,000ppm	chemical products
7096	Copper telluride (CuTe)	12019-23-7	Contains (regardless of intentional or impurities)	chemical products
7097	Copper compound with zinc (1:1)	12019-27-1	Intentional addition / 1,000ppm	chemical products
7098	Copper telluride (Cu2Te)	12019-52-2	Contains (regardless of intentional or impurities)	chemical products
7099	Copper phosphide (Cu3P)	12019-57-7	Intentional addition / 1,000ppm	chemical products
7100	Copper compound with tin (6:5)	12019-69-1	Contains (regardless of intentional or impurities)	chemical products
7101	Antimony compound with dysprosium (1:1)	12019-92-0	Contains (regardless of intentional or impurities)	chemical products
7102	Dysprosium selenide (Dy2Se3)	12020-04-1	Contains (regardless of intentional or impurities)	chemical products
7103	Antimony compound with erbium (1:1)	12020-24-5	Contains (regardless of intentional or impurities)	chemical products
7104	Erbium selenide (Er2Se3)	12020-38-1	Contains (regardless of intentional or impurities)	chemical products
7105	Erbium telluride (Er2Te3)	12020-39-2	Contains (regardless of intentional or impurities)	chemical products
7106	Europium selenide (EuSe)	12020-66-5	Contains (regardless of intentional or impurities)	chemical products
7107	Europium telluride (EuTe)	12020-69-8	Contains (regardless of intentional or impurities)	chemical products
7108	Cobalt hexafluoroarsenate(2-)	12021-67-9	Contains (regardless of intentional or impurities)	chemical products
7109	Zirconate(2-), hexafluoro-, dihydrogen (OC-6-11)-	12021-95-3	Contains (regardless of intentional or impurities)	chemical products
7110	Ferrate (FeO21-), lithium	12022-46-7	1%	chemical products
7111	Iron vanadium oxide (FeV2O4)	12022-76-3	Intentional addition / 1%	chemical products
7112	Antimony compound with iron (1:1)	12022-92-3	Contains (regardless of intentional or impurities)	chemical products
7113	Antimony compound with iron (2:1)	12022-93-4	Contains (regardless of intentional or impurities)	chemical products
7114	Iron telluride (FeTe2)	12023-03-9	Contains (regardless of intentional or impurities)	chemical products
7115	Iron molybdenum oxide (Fe2MoO4)	12023-18-6	1%	chemical products
7116	Iron nitride (Fe2N)	12023-20-0	1%	chemical products
7117	Ferrate (FeO21-), strontium (2:1)	12023-25-5	1%	chemical products
7118	Diiron titanium pentoxide	12023-27-7	1%	chemical products
7119	Iron compound with zirconium (2:1)	12023-45-9	Contains (regardless of intentional or impurities)	chemical products
7120	Iron phosphide (Fe3P)	12023-53-9	Intentional addition / 1%	chemical products
7121	Iron nitride (Fe4N)	12023-64-2	1%	chemical products
7122	Gallium selenide (GaSe)	12024-11-2	Contains (regardless of intentional or impurities)	chemical products
7123	Gallium telluride (GaTe)	12024-14-5	Contains (regardless of intentional or impurities)	chemical products
7124	Gallium selenide (Ga2Se3)	12024-24-7	Contains (regardless of intentional or impurities)	chemical products
7125	Gallium telluride (Ga2Te3)	12024-27-0	Contains (regardless of intentional or impurities)	chemical products
7126	Antimony compound with gadolinium (1:1)	12024-80-5	Contains (regardless of intentional or impurities)	chemical products
7127	Gadolinium selenide (Gd2Se3)	12024-90-7	Contains (regardless of intentional or impurities)	chemical products
7128	Germanium telluride (GeTe)	12025-39-7	Contains (regardless of intentional or impurities)	chemical products
7129	Manganese hydroxide oxide	12025-99-9	Contains (regardless of intentional or impurities)	chemical products
7130	Molybdenum vanadium oxide (MoV2O8)	12026-00-5	Intentional addition / 1%	chemical products
7131	Thallium hydroxide (Tl(OH)2)	12026-06-1	Contains (regardless of intentional or impurities)	chemical products
7132	Sodium trivanadium octaoxide	12026-08-3	Intentional addition / 1%	chemical products
7133	Tin hydroxide (Sn(OH)2)	12026-24-3	Contains (regardless of intentional or impurities)	chemical products
7134	Hydrogen sulfide (H2S2)	12026-48-1	1%	chemical products
7135	Molybdate(3-), tetracosam-oxododecaoxo[mu.12-[phosphato(3-)-O,O,O',O':O'-O'-O'-O'-O'-O']dodeca-, trihydrogen	12026-57-2	Contains (regardless of intentional or impurities)	chemical products
7136	Molybdate(3-), tetracosam-oxododecaoxo[mu.12-[phosphato(3-)-O,O,O',O':O'-O'-O'-O'-O'-O']dodeca-, diammonium hydrogen	12026-65-2	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
7137	Molybdate(3-), tetracos- $\mu$ -oxododecaoxo[ $\mu$ ,12-[phosphato(3-)-O,O,O',O':O':O':O':O':O':O':O']dodeca-, triammonium	12026-66-3	Contains (regardless of intentional or impurities)	chemical products
7138	Tungstate(3-), tetracos- $\mu$ -oxododecaoxo[ $\mu$ ,12-[phosphato(3-)-O,O,O',O':O':O':O':O':O':O':O']dodeca-, diammonium hydrogen	12026-92-5	1%	chemical products
7139	Triammonium 12-wolframophosphate	12026-93-6	1%	chemical products
7140	Hafnium hydroxide (Hf(OH) <sub>4</sub> ), (T-4)-	12027-05-3	1%	chemical products
7141	Ammonium iodide (NH <sub>4</sub> I)	12027-06-4	Intentional addition / 1%	chemical products
7142	Tetrahydrogen [ $\mu$ ,12-[orthosilicato(4-)-O,O,O',O':O':O':O':O':O':O':O']tetracos- $\mu$ -oxododecaoxododecamolybdate(4-)	12027-12-2	Contains (regardless of intentional or impurities)	chemical products
7143	Dipotassium tin hexahydroxide	12027-61-1	Contains (regardless of intentional or impurities)	chemical products
7144	Molybdate (Mo7O24 <sup>6-</sup> ), hexammonium	12027-67-7	Contains (regardless of intentional or impurities)	chemical products
7145	Stannate (Sn(OH) <sub>6</sub> <sup>2-</sup> ), disodium, (OC-6-11)-	12027-70-2	Contains (regardless of intentional or impurities)	chemical products
7146	Barium oxide silicate (Ba <sub>3</sub> O/SiO <sub>4</sub> )	12027-74-6	Intentional addition	chemical products
7147	Sodium zirconium oxide silicate (Na <sub>2</sub> ZrO/SiO <sub>4</sub> )	12027-83-7	Contains (regardless of intentional or impurities)	chemical products
7148	Yttrium oxide silicate (Y <sub>2</sub> O/SiO <sub>4</sub> )	12027-88-2	1%	chemical products
7149	Tin zinc hydroxide	12027-96-2	Contains (regardless of intentional or impurities)	chemical products
7150	Ammonium wolframate	12028-06-7	Intentional addition / 1%	chemical products
7151	Tungstate (W12(OH)2O386 <sup>6-</sup> ), hexammonium	12028-48-7	1%	chemical products
7152	Hafnium oxide (HfO)	12029-22-0	1%	chemical products
7153	Antimony, compound with holmium (1:1)	12029-86-6	Contains (regardless of intentional or impurities)	chemical products
7154	Holmium selenide	12029-87-7	Contains (regardless of intentional or impurities)	chemical products
7155	Indium sulfide (InS)	12030-14-7	1%	chemical products
7156	Indium sulfide (In <sub>2</sub> S <sub>3</sub> )	12030-24-9	1%	chemical products
7157	Zirconate (ZrO3 <sup>2-</sup> ), dipotassium	12030-98-7	Contains (regardless of intentional or impurities)	chemical products
7158	Lanthanum nickel oxide	12031-41-3	Contains (regardless of intentional or impurities)	chemical products
7159	Lanthanum selenide (La <sub>2</sub> Se <sub>3</sub> )	12031-51-5	Contains (regardless of intentional or impurities)	chemical products
7160	Lanthanum telluride (La <sub>2</sub> Te <sub>3</sub> )	12031-53-7	Contains (regardless of intentional or impurities)	chemical products
7161	Lithium nickel oxide (LiNiO <sub>2</sub> )	12031-65-1	Contains (regardless of intentional or impurities)	chemical products
7162	Lithium tantalum oxide (LiTaO <sub>3</sub> )	12031-66-2	1%	chemical products
7163	Lithium manganese nickel oxide	12031-75-3	Contains (regardless of intentional or impurities)	chemical products
7164	Zirconate (ZrO3 <sup>2-</sup> ), dilithium	12031-83-3	Contains (regardless of intentional or impurities)	chemical products
7165	Antimony, compound with lutetium (1:1)	12032-10-9	Contains (regardless of intentional or impurities)	chemical products
7166	Stannate (SnO3 <sup>2-</sup> ), magnesium (1:1)	12032-29-0	Contains (regardless of intentional or impurities)	chemical products
7167	Zirconate (ZrO3 <sup>2-</sup> ), magnesium (1:1)	12032-31-4	Contains (regardless of intentional or impurities)	chemical products
7168	Magnesium telluride (MgTe)	12032-44-9	Contains (regardless of intentional or impurities)	chemical products
7169	Manganese niobium oxide (MnNb <sub>2</sub> O <sub>6</sub> )	12032-69-8	Contains (regardless of intentional or impurities)	chemical products
7170	Manganese titanium oxide (MnTiO <sub>3</sub> )	12032-74-5	Contains (regardless of intentional or impurities)	chemical products
7171	Manganese yttrium oxide (MnYO <sub>3</sub> )	12032-75-6	Contains (regardless of intentional or impurities)	chemical products
7172	Manganese phosphide (MnP)	12032-78-9	Contains (regardless of intentional or impurities)	chemical products
7173	Antimony, compound with manganese (1:1)	12032-82-5	Contains (regardless of intentional or impurities)	chemical products
7174	Manganese silicide	12032-85-8	Contains (regardless of intentional or impurities)	chemical products
7175	Manganese silicide (MnSi <sub>2</sub> )	12032-86-9	Contains (regardless of intentional or impurities)	chemical products
7176	Manganese telluride (MnTe)	12032-88-1	Contains (regardless of intentional or impurities)	chemical products
7177	Manganese telluride (MnTe <sub>2</sub> )	12032-89-2	Contains (regardless of intentional or impurities)	chemical products
7178	Antimony, compound with manganese (1:2)	12032-97-2	Contains (regardless of intentional or impurities)	chemical products
7179	Manganese nitride (Mn <sub>3</sub> N <sub>2</sub> )	12033-03-3	1%	chemical products
7180	Manganese nitride (Mn <sub>4</sub> N)	12033-07-7	Contains (regardless of intentional or impurities)	chemical products
7181	Manganese nitride (Mn <sub>5</sub> N <sub>2</sub> )	12033-08-8	1%	chemical products
7182	Molybdenum nitride (MoN)	12033-19-1	Contains (regardless of intentional or impurities)	chemical products
7183	Molybdenum sulfide (MoS <sub>3</sub> )	12033-29-3	Contains (regardless of intentional or impurities)	chemical products
7184	Molybdenum sulfide (Mo <sub>3</sub> S <sub>5</sub> )	12033-37-3	1%	chemical products
7185	Molybdenum vanadium oxide (Mo <sub>4</sub> V <sub>6</sub> O <sub>25</sub> )	12033-39-5	Intentional addition / 1%	chemical products
7186	Pentamolybdenum trisulfide	12033-40-8	Contains (regardless of intentional or impurities)	chemical products
7187	Selenium nitride	12033-59-9	Contains (regardless of intentional or impurities)	chemical products
7188	Platinate(2-), bis(nitro-N)[sulfato(2-)-O,O']-, dihydrogen, (SP-4-2)-	12033-81-7	Contains (regardless of intentional or impurities)	chemical products
7189	Sodium superoxide	12034-12-7	Contains (regardless of intentional or impurities)	chemical products
7190	Tantalate (TaO3 <sup>1-</sup> ), sodium	12034-15-0	1%	chemical products
7191	Zincate (ZnO2 <sup>2-</sup> ), disodium	12034-31-0	Intentional addition / 1%	chemical products
7192	Sodium telluride (Na <sub>2</sub> Te)	12034-41-2	Contains (regardless of intentional or impurities)	chemical products
7193	Nickel, compound with niobium (1:1)	12034-55-8	Contains (regardless of intentional or impurities)	chemical products
7194	Niobium selenide (NbSe <sub>2</sub> )	12034-77-4	Contains (regardless of intentional or impurities)	chemical products
7195	Niobium telluride (NbTe <sub>2</sub> )	12034-83-2	Contains (regardless of intentional or impurities)	chemical products
7196	Antimony, compound with neodymium (1:1)	12035-23-3	Contains (regardless of intentional or impurities)	chemical products
7197	Neodymium selenide (Nd <sub>2</sub> Se <sub>3</sub> )	12035-33-5	Contains (regardless of intentional or impurities)	chemical products
7198	Neodymium telluride (Nd <sub>2</sub> Te <sub>3</sub> )	12035-35-7	Contains (regardless of intentional or impurities)	chemical products
7199	Nickel dioxide	12035-36-8	Contains (regardless of intentional or impurities)	chemical products
7200	Nickel tin trioxide	12035-38-0	Contains (regardless of intentional or impurities)	chemical products
7201	Nickel titanium oxide	12035-39-1	Contains (regardless of intentional or impurities)	chemical products
7202	Vaesite (NiS <sub>2</sub> )	12035-50-6	Contains (regardless of intentional or impurities)	chemical products
7203	Nickel disulfide	12035-51-7	Contains (regardless of intentional or impurities)	chemical products
7204	Antimony, compound with nickel (1:1)	12035-52-8	Contains (regardless of intentional or impurities)	chemical products
7205	Nickel silicide (NiSi)	12035-57-3	Contains (regardless of intentional or impurities)	chemical products
7206	Nickel phosphide (Ni <sub>2</sub> P)	12035-64-2	Contains (regardless of intentional or impurities)	chemical products
7207	Nickel subsulfide	12035-71-1	Contains (regardless of intentional or impurities)	chemical products
7208	Nickel sulfide (Ni <sub>3</sub> S <sub>2</sub> )	12035-72-2	Contains (regardless of intentional or impurities)	chemical products
7209	Nickel sulfide (Ni <sub>9</sub> S <sub>8</sub> )	12035-77-7	Contains (regardless of intentional or impurities)	chemical products
7210	Platinum(II) oxide	12035-82-4	Contains (regardless of intentional or impurities)	chemical products
7211	Vanadium oxide (VO)	12035-98-2	Intentional addition / 1%	chemical products
7212	Zirconium oxide	12036-01-0	Contains (regardless of intentional or impurities)	chemical products
7213	Vanadium oxide (VO <sub>2</sub> )	12036-21-4	Intentional addition / 1%	chemical products
7214	Baddeleyite (ZrO <sub>2</sub> )	12036-23-6	Contains (regardless of intentional or impurities)	chemical products
7215	Rhodium oxide (Rh <sub>2</sub> O <sub>3</sub> )	12036-35-0	Contains (regardless of intentional or impurities)	chemical products
7216	Tin zinc oxide	12036-37-2	Contains (regardless of intentional or impurities)	chemical products
7217	Strontium zirconium oxide (SrZrO <sub>3</sub> )	12036-39-4	Contains (regardless of intentional or impurities)	chemical products
7218	Titanium zinc oxide (TiZnO <sub>3</sub> )	12036-43-0	Intentional addition	chemical products
7219	Zirconium titanate	12036-70-3	Contains (regardless of intentional or impurities)	chemical products
7220	Uranium dioxideperoxide	12036-71-4	Contains (regardless of intentional or impurities)	chemical products
7221	Yttrium selenide (Y <sub>2</sub> Se <sub>3</sub> )	12036-87-2	Contains (regardless of intentional or impurities)	chemical products
7222	Zirconium phosphide (ZrP)	12037-72-8	Contains (regardless of intentional or impurities)	chemical products
7223	Zinc phosphide (Zn <sub>3</sub> P <sub>2</sub> )	12037-79-5	Intentional addition / 1%	chemical products
7224	Tetraphosphorus heptasulfide	12037-82-0	Contains (regardless of intentional or impurities)	chemical products
7225	Triuranium tetraphosphide	12037-84-2	Contains (regardless of intentional or impurities)	chemical products
7226	Praseodymium selenide (PrSe)	12038-08-3	Contains (regardless of intentional or impurities)	chemical products
7227	Praseodymium telluride (PrTe <sub>3</sub> )	12038-12-9	Contains (regardless of intentional or impurities)	chemical products
7228	Antimony, compound with rubidium (1:3)	12038-62-9	Contains (regardless of intentional or impurities)	chemical products
7229	Rhenium selenide (ReSe <sub>2</sub> )	12038-64-1	Contains (regardless of intentional or impurities)	chemical products
7230	Uranium disulfide	12038-14-4	Contains (regardless of intentional or impurities)	chemical products
7231	Zirconium sulfide (ZrS <sub>2</sub> )	12039-15-5	Contains (regardless of intentional or impurities)	chemical products
7232	Thallium sulfide (Tl <sub>2</sub> S <sub>3</sub> )	12039-17-7	Contains (regardless of intentional or impurities)	chemical products
7233	Yttrium sulfide (Y <sub>2</sub> S <sub>3</sub> )	12039-19-9	1%	chemical products
7234	Antimony, compound with terbium (1:1)	12039-31-5	Contains (regardless of intentional or impurities)	chemical products
7235	Antimony, compound with thulium (1:1)	12039-33-7	Contains (regardless of intentional or impurities)	chemical products
7236	Antimony, compound with ytterbium (1:1)	12039-34-8	Contains (regardless of intentional or impurities)	chemical products
7237	Antimony, compound with zinc (1:1)	12039-35-9	Contains (regardless of intentional or impurities)	chemical products
7238	Antimony telluride (Sb <sub>2</sub> Te)	12039-37-1	Contains (regardless of intentional or impurities)	chemical products
7239	Terbium selenide (TbSe)	12039-51-9	Contains (regardless of intentional or impurities)	chemical products
7240	Thallium(I) selenide	12039-52-0	Contains (regardless of intentional or impurities)	chemical products
7241	Thulium selenide (TmSe)	12039-53-1	Contains (regardless of intentional or impurities)	chemical products
7242	Ytterbium selenide (YbSe)	12039-54-2	Contains (regardless of intentional or impurities)	chemical products
7243	Tantalum selenide (TaSe <sub>2</sub> )	12039-55-3	Contains (regardless of intentional or impurities)	chemical products
7244	Vanadium silicide (V <sub>3</sub> Si)	12039-76-8	Intentional addition / 1%	chemical products
7245	Uranium disilicide	12039-85-9	Contains (regardless of intentional or impurities)	chemical products
7246	Vanadium silicide (VSi <sub>2</sub> )	12039-87-1	Intentional addition / 1%	chemical products
7247	Zirconium silicide (ZrSi <sub>2</sub> )	12039-90-6	Contains (regardless of intentional or impurities)	chemical products
7248	Pentazirconium trisulfide	12039-97-3	Contains (regardless of intentional or impurities)	chemical products
7249	Tin telluride (SnTe)	12040-02-7	Contains (regardless of intentional or impurities)	chemical products
7250	Strontium telluride (SrTe)	12040-08-3	Contains (regardless of intentional or impurities)	chemical products
7251	Terbium telluride (TbTe <sub>3</sub> )	12040-11-8	Contains (regardless of intentional or impurities)	chemical products
7252	Thallium telluride (TlTe)	12040-12-9	Contains (regardless of intentional or impurities)	chemical products
7253	Dithallium telluride	12040-13-0	Contains (regardless of intentional or impurities)	chemical products
7254	Thallium telluride (Tl <sub>2</sub> Te <sub>3</sub> )	12040-16-3	Contains (regardless of intentional or impurities)	chemical products
7255	Boric acid, calcium salt	12040-58-3	1%	chemical products
7256	Aluminum boride (AlB <sub>2</sub> )	12041-50-8	1%	chemical products
7257	Aluminum boride (AlB <sub>12</sub> )	12041-54-2	1%	chemical products
7258	Dialuminum copper tetraoxide	12042-92-1	Intentional addition / 1,000ppm	chemical products
7259	Aluminum telluride (Al <sub>2</sub> Te <sub>3</sub> )	12043-29-7	Contains (regardless of intentional or impurities)	chemical products
7260	Aluminum, compound with yttrium (2:1)	12043-30-0	1%	chemical products
7261	Aluminum, compound with manganese (6:1)	12043-69-5	Contains (regardless of intentional or impurities)	chemical products
7262	Iron arsenide (FeAs)	12044-16-5	Contains (regardless of intentional or impurities)	chemical products
7263	Gallium arsenide phosphide (Ga <sub>2</sub> AsP)	12044-20-1	Contains (regardless of intentional or impurities)	chemical products
7264	Potassium arsenide (K <sub>3</sub> As)	12044-21-2	Contains (regardless of intentional or impurities)	chemical products
7265	Lithium arsenide (Li <sub>3</sub> As)	12044-22-3	Contains (regardless of intentional or impurities)	chemical products
7266	Sodium arsenide (Na <sub>3</sub> As)	12044-25-6	Contains (regardless of intentional or impurities)	chemical products
7267	Praseodymium arsenide (PrAs)	12044-28-9	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
7268	Realgar	12044-30-3	Contains (regardless of intentional or impurities)	chemical products
7269	Arsenic selenide (As <sub>0.1</sub> Se <sub>0.9</sub> )	12044-31-4	Contains (regardless of intentional or impurities)	chemical products
7270	Tin arsenide (SnAs)	12044-32-5	Contains (regardless of intentional or impurities)	chemical products
7271	Cobalt arsenide (CoAs <sub>2</sub> )	12044-42-7	Contains (regardless of intentional or impurities)	chemical products
7272	Magnesium arsenide (Mg <sub>3</sub> As <sub>2</sub> )	12044-49-4	Contains (regardless of intentional or impurities)	chemical products
7273	Arsenic oxide (As <sub>2</sub> O <sub>5</sub> ), hydrate (3:5)	12044-50-7	Contains (regardless of intentional or impurities)	chemical products
7274	Platinum arsenide	12044-52-9	Contains (regardless of intentional or impurities)	chemical products
7275	Arsenic telluride (As <sub>2</sub> Te <sub>3</sub> )	12044-54-1	Contains (regardless of intentional or impurities)	chemical products
7276	Zinc arsenide (ZnAs <sub>2</sub> )	12044-55-2	Contains (regardless of intentional or impurities)	chemical products
7277	Arsenic selenide (As <sub>3</sub> Se <sub>7</sub> )	12044-57-4	Contains (regardless of intentional or impurities)	chemical products
7278	Nickel arsenide	12044-65-4	Contains (regardless of intentional or impurities)	chemical products
7279	Arsino, thio-	12044-79-0	Contains (regardless of intentional or impurities)	chemical products
7280	Cobalt boride (Co <sub>2</sub> B)	12045-01-1	Intentional addition / 100ppm	chemical products
7281	Manganese boride (MnB)	12045-15-7	Contains (regardless of intentional or impurities)	chemical products
7282	Manganese boride (Mn <sub>2</sub> B)	12045-16-8	Contains (regardless of intentional or impurities)	chemical products
7283	Niobium boride (NbB)	12045-19-1	1%	chemical products
7284	Rhenium boride	12045-23-7	1%	chemical products
7285	Boron sulfide (BS <sub>2</sub> )	12045-25-9	1%	chemical products
7286	Vanadium boride (VB)	12045-27-1	Intentional addition / 1%	chemical products
7287	Zirconium boride (ZrB)	12045-28-2	Contains (regardless of intentional or impurities)	chemical products
7288	Barium metaborate metaphosphate	12045-29-3	Contains (regardless of intentional or impurities)	chemical products
7289	Chromium boride (Cr <sub>3</sub> B <sub>2</sub> )	12045-40-8	1,000ppm	chemical products
7290	Nickel boride (NiB <sub>2</sub> )	12045-56-6	Contains (regardless of intentional or impurities)	chemical products
7291	Nickel boride	12045-58-8	Contains (regardless of intentional or impurities)	chemical products
7292	Boron oxide (B <sub>2</sub> O)	12045-60-2	1%	chemical products
7293	Titanium boride (TiB <sub>2</sub> )	12045-63-5	1%	chemical products
7294	Zirconium boride (ZrB <sub>2</sub> )	12045-64-6	Contains (regardless of intentional or impurities)	chemical products
7295	Nickel boride (Ni <sub>4</sub> B <sub>3</sub> )	12045-67-9	Contains (regardless of intentional or impurities)	chemical products
7296	Chromium boride (Cr <sub>3</sub> B <sub>4</sub> )	12045-71-5	1,000ppm	chemical products
7297	Holmium boride (HoB <sub>4</sub> ), (T-4)-	12045-77-1	1%	chemical products
7298	Potassium borate tetrahydrate	12045-78-2	1%	chemical products
7299	Tincolonite	12045-88-4	1%	chemical products
7300	Titanium boride (Ti <sub>3</sub> B <sub>4</sub> )	12045-93-1	1%	chemical products
7301	Tungsten boride (WB <sub>4</sub> ), (T-4)-	12045-94-2	1%	chemical products
7302	Borate(5-), bis[μ-oxotetraoxodiborate(4-)]-, ammonium tetrahydrogen, dihydrate, (T-4)-	12046-04-7	1%	chemical products
7303	Barium boride (BaB <sub>6</sub> ), (OC-6-11)-	12046-08-1	Intentional addition / 1%	chemical products
7304	Erbium hexaboride	12046-33-2	1%	chemical products
7305	Holmium hexaboride	12046-36-5	1%	chemical products
7306	Lutetium hexaboride	12046-37-6	1%	chemical products
7307	Strontium boride (SrB <sub>6</sub> ), (OC-6-11)-	12046-54-7	1%	chemical products
7308	Thulium hexaboride	12046-55-8	1%	chemical products
7309	Decaborane(12), 6,9-diammine-	12046-71-8	1%	chemical products
7310	Boron sodium oxide (B <sub>5</sub> NaO <sub>8</sub> ), pentahydrate	12046-75-2	1%	chemical products
7311	Tungsten boride (WB <sub>12</sub> )	12046-89-8	1%	chemical products
7312	Zirconium boride (ZrB <sub>12</sub> )	12046-91-2	Contains (regardless of intentional or impurities)	chemical products
7313	Barium, compound with bismuth (1:3)	12047-02-8	Intentional addition	chemical products
7314	Barium dodecairon nonadecaoxide	12047-11-9	Contains (regardless of intentional or impurities)	chemical products
7315	Barium titanium oxide (BaTiO <sub>3</sub> )	12047-27-7	Intentional addition / 1,000ppm	chemical products
7316	Barium ditantalum hexaoxide	12047-34-6	Contains (regardless of intentional or impurities)	chemical products
7317	Barium titanium oxide (Ba <sub>2</sub> Ti <sub>9</sub> O <sub>20</sub> )	12047-64-2	Intentional addition	chemical products
7318	Barium nitride (Ba <sub>3</sub> N <sub>2</sub> )	12047-79-9	Intentional addition	chemical products
7319	Niobate (NbO <sub>4</sub> 3-), barium sodium (3:4:1), (T-4)-	12047-92-6	Intentional addition / 1%	chemical products
7320	Bismuth, compound with thallium (1:1)	12048-36-1	Contains (regardless of intentional or impurities)	chemical products
7321	Bismuth zirconium oxide (Bi <sub>2</sub> Zr <sub>3</sub> O <sub>9</sub> )	12048-52-1	Contains (regardless of intentional or impurities)	chemical products
7322	Calcium molybdenum oxide (CaMoO <sub>3</sub> )	12048-45-5	1%	chemical products
7323	Manganate (MnO <sub>2</sub> 1-), calcium (2:1)	12049-47-7	1%	chemical products
7324	Cobalt iron oxide (CoFe <sub>2</sub> O <sub>4</sub> )	12052-28-7	Contains (regardless of intentional or impurities)	chemical products
7325	Antimony, compound with cobalt (1:1)	12052-42-5	Intentional addition / 100ppm	chemical products
7326	Cobalt, compound with yttrium (3:1)	12052-82-9	Contains (regardless of intentional or impurities)	chemical products
7327	Cobalt sulfide (Co <sub>4</sub> S <sub>3</sub> )	12052-84-1	Intentional addition / 1%	chemical products
7328	Cobalt, compound with yttrium (7:2)	12052-70-9	Intentional addition / 1,000ppm	chemical products
7329	Cobalt, compound with samarium (17:2)	12052-78-7	Intentional addition / 1,000ppm	chemical products
7330	Antimony, compound with chromium (1:1)	12053-12-2	Contains (regardless of intentional or impurities)	chemical products
7331	Chromium selenide (CrSe)	12053-13-3	Contains (regardless of intentional or impurities)	chemical products
7332	Copper chromite	12053-18-8	Contains (regardless of intentional or impurities)	chemical products
7333	Chromium magnesium oxide (Cr <sub>2</sub> MgO <sub>4</sub> )	12053-26-8	Contains (regardless of intentional or impurities)	chemical products
7334	Chromium nitride (Cr <sub>2</sub> N)	12053-27-9	1,000ppm	chemical products
7335	Chromium telluride (Cr <sub>2</sub> Te <sub>3</sub> )	12053-39-3	Contains (regardless of intentional or impurities)	chemical products
7336	Chromium sodium oxide (Cr <sub>3</sub> NaO <sub>8</sub> )	12053-47-3	Intentional addition / 1,000ppm	chemical products
7337	Copper selenide (CuSe <sub>2</sub> )	12054-10-3	Contains (regardless of intentional or impurities)	chemical products
7338	Antimony, compound with copper (1:2)	12054-21-6	Contains (regardless of intentional or impurities)	chemical products
7339	Antimony, compound with copper (1:3)	12054-25-0	Contains (regardless of intentional or impurities)	chemical products
7340	Nickel hydroxide (Ni(OH) <sub>2</sub> )	12054-48-7	Contains (regardless of intentional or impurities)	chemical products
7341	Tin hydroxide (Sn(OH) <sub>4</sub> )	12054-72-7	Contains (regardless of intentional or impurities)	chemical products
7342	Molybdate, hexaammonium, tetrahydrate	12054-85-2	Contains (regardless of intentional or impurities)	chemical products
7343	Sodium ammonium vanadate	12055-09-3	Contains (regardless of intentional or impurities)	chemical products
7344	Hafnium oxide (HfO <sub>2</sub> )	12055-23-1	1%	chemical products
7345	Hafnium titanium oxide (HfTi <sub>2</sub> O <sub>4</sub> )	12055-24-2	1%	chemical products
7346	Indium selenide (In <sub>2</sub> Se <sub>3</sub> )	12056-07-4	Contains (regardless of intentional or impurities)	chemical products
7347	Lithium manganese oxide (LiMn <sub>2</sub> O <sub>4</sub> )	12057-17-9	Contains (regardless of intentional or impurities)	chemical products
7348	Lithium molybdenum oxide (Li <sub>2</sub> MoO <sub>3</sub> )	12057-23-7	1%	chemical products
7349	Antimony, compound with lithium (1:3)	12057-30-6	Contains (regardless of intentional or impurities)	chemical products
7350	Magnesium phosphide	12057-74-8	Contains (regardless of intentional or impurities)	chemical products
7351	Antimony, compound with magnesium (2:3)	12057-75-9	Contains (regardless of intentional or impurities)	chemical products
7352	Dimanganese heptaoxide	12057-92-0	Contains (regardless of intentional or impurities)	chemical products
7353	Molybdenum monoxide	12058-07-0	Contains (regardless of intentional or impurities)	chemical products
7354	Molybdenum vanadium oxide (MoVO <sub>5</sub> )	12058-11-6	Intentional addition / 1%	chemical products
7355	Molybdenum selenide (MoSe <sub>2</sub> )	12058-18-3	Contains (regardless of intentional or impurities)	chemical products
7356	Molybdenum silicide	12058-19-4	1%	chemical products
7357	Molybdenum telluride (MoTe <sub>2</sub> )	12058-20-7	Contains (regardless of intentional or impurities)	chemical products
7358	Molybdenum sodium oxide (Mo <sub>3</sub> Na <sub>2</sub> O <sub>6</sub> )	12058-24-1	1%	chemical products
7359	Molybdenum zinc oxide (Mo <sub>3</sub> Zn <sub>2</sub> O <sub>8</sub> )	12058-26-3	Intentional addition / 1%	chemical products
7360	Disodium stannate	12058-66-1	Contains (regardless of intentional or impurities)	chemical products
7361	Antimony, compound with sodium (1:3)	12058-86-5	Contains (regardless of intentional or impurities)	chemical products
7362	Nickel silicide (Ni <sub>2</sub> Si)	12059-14-2	Contains (regardless of intentional or impurities)	chemical products
7363	Nickel, compound with tin (3:1)	12059-23-3	Contains (regardless of intentional or impurities)	chemical products
7364	Silicate(2-), hexafluoro-, copper(2+), (1:1)	12062-24-7	Contains (regardless of intentional or impurities)	chemical products
7365	Silicate(2-), hexafluoro-, iron(3+), (3:2)	12062-26-9	Contains (regardless of intentional or impurities)	chemical products
7366	Iron manganese trioxide	12062-81-6	Contains (regardless of intentional or impurities)	chemical products
7367	Ferrate (FeO <sub>2</sub> 1-), sodium	12062-85-0	1%	chemical products
7368	Iron yttrium oxide (Fe <sub>3</sub> Y <sub>3</sub> O <sub>12</sub> )	12063-56-8	1%	chemical products
7369	Antimony, compound with gallium (1:1)	12064-03-8	Contains (regardless of intentional or impurities)	chemical products
7370	Germanium selenide (GeSe)	12065-10-0	Contains (regardless of intentional or impurities)	chemical products
7371	Germanium selenide (GeSe <sub>2</sub> )	12065-11-1	Contains (regardless of intentional or impurities)	chemical products
7372	Tantalate (TaO <sub>3</sub> 1-), strontium (2:1)	12065-74-6	1%	chemical products
7373	Vanadium phosphide (VP)	12066-53-4	Intentional addition / 1%	chemical products
7374	Antimony, compound with praseodymium (1:1)	12066-81-8	Contains (regardless of intentional or impurities)	chemical products
7375	Rhenium telluride (ReTe <sub>2</sub> )	12067-00-4	Contains (regardless of intentional or impurities)	chemical products
7376	Rhodium sulfide (Rh <sub>2</sub> S <sub>3</sub> )	12067-06-0	Contains (regardless of intentional or impurities)	chemical products
7377	Antimony telluride (SbTe)	12067-31-1	Contains (regardless of intentional or impurities)	chemical products
7378	Titanium selenide (TiSe <sub>2</sub> )	12067-45-7	Contains (regardless of intentional or impurities)	chemical products
7379	Tungsten selenide (WSe <sub>2</sub> )	12067-46-8	Contains (regardless of intentional or impurities)	chemical products
7380	Yttrium silicide (YSi <sub>2</sub> )	12067-55-9	1%	chemical products
7381	Tantalum telluride (TaTe <sub>2</sub> )	12067-66-2	Contains (regardless of intentional or impurities)	chemical products
7382	Titanium telluride (TiTe <sub>2</sub> )	12067-75-3	Contains (regardless of intentional or impurities)	chemical products
7383	Tungsten telluride (WTe <sub>2</sub> )	12067-76-4	Contains (regardless of intentional or impurities)	chemical products
7384	Dodecylbenzenesulfonic acid, zinc salt	12068-16-5	Intentional addition / 1%	chemical products
7385	Aluminum dicalcium iron pentaoxide	12068-35-8	1%	chemical products
7386	Nickel diarsenide	12068-61-0	Contains (regardless of intentional or impurities)	chemical products
7387	Bismuth selenide (Bi <sub>2</sub> Se <sub>3</sub> )	12068-69-8	Contains (regardless of intentional or impurities)	chemical products
7388	Chromium iron oxide (Cr <sub>2</sub> FeO <sub>4</sub> )	12068-77-8	Contains (regardless of intentional or impurities)	chemical products
7389	Copper selenide (Cu <sub>3</sub> Se <sub>2</sub> )	12068-80-3	Contains (regardless of intentional or impurities)	chemical products
7390	Iron magnesium oxide (Fe <sub>2</sub> MgO <sub>4</sub> )	12068-86-9	1%	chemical products
7391	Lead selenide (PbSe)	12069-00-0	Contains (regardless of intentional or impurities)	chemical products
7392	Boron carbide (B <sub>4</sub> C)	12069-32-8	1%	chemical products
7393	[μ <sub>3</sub> -[Carbonato(2-)-O-O]]dihydroxydicobalt	12069-68-0	Intentional addition / 1,000ppm	chemical products
7394	Copper(II) carbonate hydroxide	12069-69-1	Contains (regardless of intentional or impurities)	chemical products
7395	Hafnium carbide (HfC)	12069-85-1	1%	chemical products
7396	Molybdenum carbide (Mo <sub>2</sub> C)	12069-89-5	Contains (regardless of intentional or impurities)	chemical products
7397	Hexamolybdenum carbide	12069-90-8	Contains (regardless of intentional or impurities)	chemical products
7398	Uranium carbide (UC)	12070-09-6	Contains (regardless of intentional or impurities)	chemical products
7399	Vanadium carbide (VC)	12070-10-9	Intentional addition / 1%	chemical products
7400	Zirconium carbide (ZrC)	12070-14-3	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
7401	Barium acetylide (BaC2)	12070-27-8	Intentional addition	chemical products
7402	Copper carbonate hydroxide	12070-39-2	Intentional addition / 1,000ppm	chemical products
7403	Ethanamine, tetrafluoroborate(1-)	12070-78-9	1%	chemical products
7404	Manganese carbide (Mn5C2)	12071-17-9	Contains (regardless of intentional or impurities)	chemical products
7405	Uranium dicarbide	12071-33-9	Contains (regardless of intentional or impurities)	chemical products
7406	Yttrium carbide (YC2)	12071-35-1	1%	chemical products
7407	Propineb	12071-83-9	Intentional addition / 1%	chemical products
7408	Di- $\mu$ -chlorodichlorobis(eta.2-ethylene)diplatinum	12073-36-8	Contains (regardless of intentional or impurities)	chemical products
7409	Chromium carbide (Cr7C3)	12075-40-0	1,000ppm	chemical products
7410	Aluminum, di- $\mu$ -chlorochlorotriethylid-	12075-58-2	Contains (regardless of intentional or impurities)	chemical products
7411	Decaborate(2-), decahydro-, hydrogen, compound with N,N-diethylethanamine (1:2:2)	12075-79-9	1%	chemical products
7412	Aluminum, (N,N-diethylethanamine)trihydro-, (T-4)-	12076-08-3	1%	chemical products
7413	Molybdenum carbide (Mo4C3)	12076-38-9	1%	chemical products
7414	Dicarbonyl(eta.5-2,4-cyclopentadien-1-yl)cobalt	12078-25-0	Intentional addition / 1,000ppm	chemical products
7415	(eta.1-3-Butadiene)tricarbonyliron	12078-32-9	1%	chemical products
7416	Manganese cyclopentadienyl tricarbonyl	12079-85-1	Contains (regardless of intentional or impurities)	chemical products
7417	Di- $\mu$ -chlorotetrakis(eta.2-ethylene)dirhodium	12081-16-2	Contains (regardless of intentional or impurities)	chemical products
7418	(eta.6-Benzene)tricarbonylchromium	12082-08-5	1,000ppm	chemical products
7419	Bis(eta.2-ethylene)(pentane-2,4-dionato-O,O')rhodium	12082-47-2	Contains (regardless of intentional or impurities)	chemical products
7420	Tricarbonyl[(1,2,3,4,5,6-eta.)-toluene]chromium	12083-24-8	1,000ppm	chemical products
7421	Tricarbonyl[(1,2,3,4,5,6-eta.)-o-toluidine]chromium	12083-33-9	1,000ppm	chemical products
7422	Dichlorobis(eta.5-cyclopenta-2,4-dien-1-yl)vanadium	12083-48-6	Contains (regardless of intentional or impurities)	chemical products
7423	Bis(pentane-2,4-dionato-O,O')barium	12084-29-6	Contains (regardless of intentional or impurities)	chemical products
7424	(Ferrocen-1-yl)methyltrimethylammonium iodide	12086-40-7	1%	chemical products
7425	Hexacarbonylbis(eta.5-cyclopenta-2,4-dien-1-yl)dimolybdenum	12091-64-4	Contains (regardless of intentional or impurities)	chemical products
7426	Rhodium, di- $\mu$ -chlorobis[(1,2,5,6-eta.)-1,5-cyclooctadiene]di-	12092-47-6	Contains (regardless of intentional or impurities)	chemical products
7427	Ferrocene, formyl-	12093-10-6	1%	chemical products
7428	Bis[(1,2,3,4,5,6-eta.)-1,1'-biphenyl]chromium(1+) iodide	12099-17-1	1,000ppm	chemical products
7429	Chromium carbide (Cr23C6)	12105-81-6	1,000ppm	chemical products
7430	Cyclopentadienylmolybdenum tricarbonyl sodium	12107-35-6	1%	chemical products
7431	Allyl(cyclopentadienyl)nickel(II)	12107-46-9	Contains (regardless of intentional or impurities)	chemical products
7432	1-Butanamine, N-butyl-, tetrafluoroborate(1-)	12107-76-5	Contains (regardless of intentional or impurities)	chemical products
7433	Tetracarbonyl(eta.5-cyclopenta-2,4-dien-1-yl)vanadium	12108-04-2	Intentional addition / 1%	chemical products
7434	Chromium, (aniline)tricarbonyl-	12108-11-1	1,000ppm	chemical products
7435	Tricarbonyl(methylcyclopentadienyl)manganese	12108-13-3	Contains (regardless of intentional or impurities)	chemical products
7436	Zirconium, dichlorobis[(1,2,3,4,5-eta.)-1-methyl-2,4-cyclopentadien-1-yl]-	12109-71-6	Contains (regardless of intentional or impurities)	chemical products
7437	Methylum, chlorodiphenyl-, (OC-6-11)-hexachloroantimonate(1-)	12110-39-3	Contains (regardless of intentional or impurities)	chemical products
7438	Strychnine, bis[N-salicylidene]glycinato(2-)]ferrate(1-)	12113-04-1	Contains (regardless of intentional or impurities)	chemical products
7439	Borate(1-), hydroxytriphenyl-, sodium, (T-4)-	12113-07-4	1%	chemical products
7440	Boron carbide (B4C3)	12115-61-6	1%	chemical products
7441	Chromium carbide (Cr2C3)	12115-65-0	1,000ppm	chemical products
7442	Tricarbonyl[(1,2,3,4,5,6-eta.)-methoxybenzene]chromium	12116-44-8	1,000ppm	chemical products
7443	Hafnium, dichlorobis(eta.5-2,4-cyclopentadien-1-yl)-	12116-66-4	1%	chemical products
7444	Manganese carbide (Mn3C)	12121-90-3	Contains (regardless of intentional or impurities)	chemical products
7445	Basic nickel carbonate	12122-15-5	Contains (regardless of intentional or impurities)	chemical products
7446	Molybdenum carbide (MoC2)	12122-47-3	1%	chemical products
7447	Molybdenum carbide (Mo3C2)	12122-48-4	1%	chemical products
7448	Zinc	12122-67-7	Contains (regardless of intentional or impurities)	chemical products
7449	Dichlorohydrotris(triphenylphosphine)rhodium	12124-48-0	Contains (regardless of intentional or impurities)	chemical products
7450	Ammonium bromide	12124-97-9	Intentional addition / 1,000ppm	chemical products
7451	Ammonium hydrogen sulfide	12124-99-1	Contains (regardless of intentional or impurities)	chemical products
7452	Ammonium fluoride	12125-01-8	Contains (regardless of intentional or impurities)	chemical products
7453	Ammonium chloride	12125-02-9	Contains (regardless of intentional or impurities)	chemical products
7454	Stannate, dipotassium, trihydrate	12125-03-0	Contains (regardless of intentional or impurities)	chemical products
7455	Copper hydroxide (Cu(OH))	12125-21-2	1,000ppm	chemical products
7456	Manganese disulfide	12125-23-4	Contains (regardless of intentional or impurities)	chemical products
7457	Indium hydroxide oxide	12125-59-0	1%	chemical products
7458	Nickel hydroxide	12125-56-3	Contains (regardless of intentional or impurities)	chemical products
7459	Ytterbium telluride (YbTe)	12125-58-5	Contains (regardless of intentional or impurities)	chemical products
7460	Iron telluride (FeTe)	12125-63-2	Contains (regardless of intentional or impurities)	chemical products
7461	Tricarbonyl[(1,2,3,4,5,6-eta.)-1,3,5-cycloheptatriene]chromium	12125-72-3	1,000ppm	chemical products
7462	Tricarbonyl[(1,2,3,4,5,6-eta.)cyclohepta-1,3,5-triene]molybdenum	12125-77-8	Contains (regardless of intentional or impurities)	chemical products
7463	Rhodium carbide	12127-42-3	Contains (regardless of intentional or impurities)	chemical products
7464	Cyclopentadienylmolybdenumtricarbonyl chloride	12128-23-3	1%	chemical products
7465	Platinate(1-), (1-acetyl-2-oxopropyl)chloro(2,4-pentanedionato-O,O')-, hydrogen, (SP-4-2)-	12129-03-2	Contains (regardless of intentional or impurities)	chemical products
7466	Trichloro(pentamethylcyclopentadienyl)titanium(IV)	12129-06-5	Contains (regardless of intentional or impurities)	chemical products
7467	Tricarbonyl(p-xylene)chromium	12129-27-0	1,000ppm	chemical products
7468	Tricarbonyl[(1,2,3,4,5,6-eta.)-1,3,5-trimethylbenzene]chromium	12129-67-8	1,000ppm	chemical products
7469	Dicarbonyl(pentamethylcyclopentadienyl)molybdenum(V) dimer	12132-04-6	1%	chemical products
7470	Cobalt phosphide (Co2P)	12134-02-0	Intentional addition / 100ppm	chemical products
7471	Trichromium disilicide	12134-19-9	1,000ppm	chemical products
7472	Copper phosphide (Cu3P2)	12134-35-9	Intentional addition / 1,000ppm	chemical products
7473	Uranium fluoride (U2F9)	12134-48-4	Contains (regardless of intentional or impurities)	chemical products
7474	Sodium hydrogen sulfide dihydrate	12135-05-6	1%	chemical products
7475	Iron molybdenum oxide (Fe2Mo4O15)	12135-57-8	1%	chemical products
7476	Ammonium sulfide ((NH4)2S)	12135-76-1	Contains (regardless of intentional or impurities)	chemical products
7477	Indium oxide (InO)	12136-26-4	1%	chemical products
7478	Lithium telluride (Li2Te)	12136-59-3	Contains (regardless of intentional or impurities)	chemical products
7479	Lithium selenide (Li2Se)	12136-60-6	Contains (regardless of intentional or impurities)	chemical products
7480	Molybdenum silicide (MoSi2)	12136-78-6	Contains (regardless of intentional or impurities)	chemical products
7481	Nickel sulfide (Ni2S)	12137-08-5	Contains (regardless of intentional or impurities)	chemical products
7482	Nickel oxide (Ni3O4)	12137-09-6	Contains (regardless of intentional or impurities)	chemical products
7483	Trinickel tetrasulfide	12137-12-1	Contains (regardless of intentional or impurities)	chemical products
7484	Nickel subselenide	12137-13-2	Contains (regardless of intentional or impurities)	chemical products
7485	Rhodium dioxide	12137-27-8	Contains (regardless of intentional or impurities)	chemical products
7486	Palladium selenide (PdSe)	12137-76-7	Contains (regardless of intentional or impurities)	chemical products
7487	Uranium selenide (USe2)	12138-21-5	Contains (regardless of intentional or impurities)	chemical products
7488	Zirconium silicide	12138-26-0	Contains (regardless of intentional or impurities)	chemical products
7489	Uranium telluride (UTe2)	12138-37-3	Contains (regardless of intentional or impurities)	chemical products
7490	Dicalcium tin tetraoxide	12138-89-5	Contains (regardless of intentional or impurities)	chemical products
7491	Cadmium peroxide (Cd(O2))	12139-22-9	Contains (regardless of intentional or impurities)	chemical products
7492	Cadmium zirconium oxide (CdZrO3)	12139-23-0	Contains (regardless of intentional or impurities)	chemical products
7493	Cobalt tin oxide (Co2SnO4)	12139-93-4	Contains (regardless of intentional or impurities)	chemical products
7494	Tungstate (W12(OH)2O386-), hexasodium	12141-67-2	Contains (regardless of intentional or impurities)	chemical products
7495	Stannate (SnO32-), dipotassium	12142-33-5	Contains (regardless of intentional or impurities)	chemical products
7496	Potassium telluride (K2Te)	12142-40-4	Contains (regardless of intentional or impurities)	chemical products
7497	Manganate (MnO43-), tripotassium, (T-4)-	12142-41-5	Contains (regardless of intentional or impurities)	chemical products
7498	Antimony, compound with lanthanum (1:1)	12142-89-7	Contains (regardless of intentional or impurities)	chemical products
7499	Nickel telluride	12142-88-0	Contains (regardless of intentional or impurities)	chemical products
7500	Nickel, compound with zirconium (1:2)	12142-92-6	Contains (regardless of intentional or impurities)	chemical products
7501	Strontium tin oxide (SrSnO3)	12143-34-9	Contains (regardless of intentional or impurities)	chemical products
7502	Pentavanadium trisilicide	12143-78-1	Intentional addition / 1%	chemical products
7503	Platinum, di- $\mu$ -chlorodichlorobis(eta.2-ethene)di-, stereoisomer	12144-54-6	Contains (regardless of intentional or impurities)	chemical products
7504	1,1'-Bis(chloromercuryl)ferrocene, technical	12145-90-3	Contains (regardless of intentional or impurities)	chemical products
7505	(Bicyclo[2.2.1]hepta-2,5-diene)tetracarbonylmolybdenum(0)	12146-37-1	1%	chemical products
7506	Zirconium, dichlorobis[(1,2,3,3a,7a-eta.)-1H-inden-1-yl]-	12148-49-1	Contains (regardless of intentional or impurities)	chemical products
7507	(Diethylphosphino)dimethylindium	12148-78-6	1%	chemical products
7508	Molybdenum carbide (Mo7C3)	12151-75-6	1%	chemical products
7509	Molybdenum carbide (Mo23C6)	12152-15-7	1%	chemical products
7510	[(2,3,5,6-eta.)-Bicyclo[2.2.1]hepta-2,5-diene]dichloroplatinum	12152-26-0	Contains (regardless of intentional or impurities)	chemical products
7511	Ferrocenemetaboric acid	12152-94-2	1%	chemical products
7512	(Methoxymethyl)ferrocene	12153-89-8	1%	chemical products
7513	Tricarbonyl[(4a,5,6,7,8,8a-eta.)-1,2,3,4-tetrahydronaphthalene]chromium	12154-63-1	1,000ppm	chemical products
7514	Di- $\mu$ -carbonyldicarbonylbis(eta.5-cyclopenta-2,4-dien-1-yl)diiron	12154-95-9	1%	chemical products
7515	Cerium zirconium oxide (Ce2Zr2O7)	12157-80-1	Contains (regardless of intentional or impurities)	chemical products
7516	Dimanganese chloridephosphate	12157-90-3	Contains (regardless of intentional or impurities)	chemical products
7517	Chromium hydroxide nitrate (Cr(OH)(NO3)2)	12158-37-1	Intentional addition / 1,000ppm	chemical products
7518	Chromium hydroxide nitrate (Cr(OH)2(NO3))	12158-48-4	Intentional addition / 1,000ppm	chemical products
7519	Tantalate (TaO31-), cesium	12158-56-4	1%	chemical products
7520	Zirconate (ZrO32-), dicesium	12158-58-6	Contains (regardless of intentional or impurities)	chemical products
7521	Dicopper hydroxide phosphate	12158-74-6	Intentional addition / 1,000ppm	chemical products
7522	Copper hydroxide nitrate (Cu2(OH)3(NO3))	12158-75-7	Intentional addition / 1,000ppm	chemical products
7523	Copper silicide (Cu5Si)	12159-07-8	Intentional addition / 1,000ppm	chemical products
7524	Dysprosium telluride (Dy2Te3)	12159-43-2	Contains (regardless of intentional or impurities)	chemical products
7525	Iron, compound with zirconium (1:2)	12160-12-2	Contains (regardless of intentional or impurities)	chemical products
7526	Gadolinium telluride (Gd2Te3)	12160-99-5	Contains (regardless of intentional or impurities)	chemical products
7527	Zirconium oxodihydroxide (Zr(O)OH2)	12161-08-9	Contains (regardless of intentional or impurities)	chemical products
7528	Bertrandite (Be4(OH)2O(SiO3)2)	12161-82-9	Contains (regardless of intentional or impurities)	chemical products
7529	Hafnium selenide (HfSe2)	12162-21-9	Contains (regardless of intentional or impurities)	chemical products
7530	Holmium selenide (Ho2Se3)	12162-60-6	Contains (regardless of intentional or impurities)	chemical products
7531	Lithium manganese oxide (Li2Mn2O4)	12162-79-7	1%	chemical products
7532	Manganate (MnO32-), dilithium	12163-00-7	Contains (regardless of intentional or impurities)	chemical products
7533	Lutetium selenide (Lu2Se3)	12163-21-2	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
7534	Lutetium telluride (Lu2Te3)	12163-22-3	Contains (regardless of intentional or impurities)	chemical products
7535	Manganese strontium oxide (MnSrO3)	12163-45-0	Contains (regardless of intentional or impurities)	chemical products
7536	Manganese nitride (Mn2N)	12163-53-0	Contains (regardless of intentional or impurities)	chemical products
7537	Trimanganese silicide	12163-59-6	Contains (regardless of intentional or impurities)	chemical products
7538	Manganese oxide (Mn5O8)	12163-64-3	1%	chemical products
7539	Molybdenum strontium oxide (MoSrO3)	12163-67-6	1%	chemical products
7540	Molybdenum phosphide (MoP)	12163-69-8	Contains (regardless of intentional or impurities)	chemical products
7541	Molybdenum silicide (MoSi3)	12163-70-1	1%	chemical products
7542	Molybdenum vanadium oxide (Mo2V4O15)	12163-74-5	Intentional addition / 1%	chemical products
7543	Trimolybdenum disulfide	12163-85-8	Contains (regardless of intentional or impurities)	chemical products
7544	Nickel selenide (NiSe2)	12164-80-8	Contains (regardless of intentional or impurities)	chemical products
7545	Diphosphorus trisulfide	12165-89-4	Contains (regardless of intentional or impurities)	chemical products
7546	Vanadium sulfide (VS)	12166-27-7	Intentional addition / 1%	chemical products
7547	Antimony compound with scandium (1:1)	12166-36-8	Contains (regardless of intentional or impurities)	chemical products
7548	Scandium selenide (Sc2Se3)	12166-43-7	Contains (regardless of intentional or impurities)	chemical products
7549	Scandium telluride (Sc2Te3)	12166-44-8	Contains (regardless of intentional or impurities)	chemical products
7550	Zirconium selenide (ZrSe2)	12166-47-1	Contains (regardless of intentional or impurities)	chemical products
7551	Thulium telluride (Tm2Te3)	12166-69-7	Contains (regardless of intentional or impurities)	chemical products
7552	Yttrium telluride (Y2Te3)	12166-71-1	Contains (regardless of intentional or impurities)	chemical products
7553	Dinitroresols	12167-18-9	Intentional addition	chemical products
7554	Dicopper dichloride oxide	12167-76-9	Intentional addition / 1,000ppm	chemical products
7555	Cupric ferric subsulfate complex	12168-20-6	Intentional addition / 1,000ppm	chemical products
7556	Diiron nickel tetraoxide	12168-54-6	Contains (regardless of intentional or impurities)	chemical products
7557	Chromium(1+),tricarbonyl(h7-cycloheptatrienyl)-,tetrafluoroborate(1-)	12170-19-3	Intentional addition / 1,000ppm	chemical products
7558	Di-μ-carbonylbis(eta-5-2,4-cyclopentadien-1-yl)dinickel	12170-92-2	Contains (regardless of intentional or impurities)	chemical products
7559	Actinolite	12172-67-7	Intentional addition / 1,000ppm	chemical products
7560	Asbestos, amosite	12172-73-5	Contains (regardless of intentional or impurities)	chemical products
7561	Pentlandite	12174-14-0	Contains (regardless of intentional or impurities)	chemical products
7562	Copper manganese oxide (Cu3Mn3O8)	12175-02-9	Contains (regardless of intentional or impurities)	chemical products
7563	Dysprosium compound with nickel (1:2)	12175-27-8	Contains (regardless of intentional or impurities)	chemical products
7564	Boron carbide (B6C)	12179-62-3	1%	chemical products
7565	1,1'-Dibenzylferrocene	12180-80-2	1%	chemical products
7566	Antimony chloride oxide	12182-69-3	Contains (regardless of intentional or impurities)	chemical products
7567	Chromium oxide (Cr2O3), hydrate	12182-82-0	1,000ppm	chemical products
7568	Molybdicene dichloride	12184-22-4	1%	chemical products
7569	Phosphorus (P4)	12185-10-3	Contains (regardless of intentional or impurities)	chemical products
7570	Cadmium stannate	12185-56-7	Contains (regardless of intentional or impurities)	chemical products
7571	Cadmium chloride phosphate (Cd5Cl(PO4)3)	12185-64-7	Contains (regardless of intentional or impurities)	chemical products
7572	Holmium telluride (Ho2Te5)	12186-84-4	Contains (regardless of intentional or impurities)	chemical products
7573	Antimony compound with yttrium (1:1)	12186-87-9	Contains (regardless of intentional or impurities)	chemical products
7574	Samarium telluride (Sm2Te5)	12187-02-9	Contains (regardless of intentional or impurities)	chemical products
7575	Cadmium niobium oxide (Cd2Nb2O7)	12187-14-3	Contains (regardless of intentional or impurities)	chemical products
7576	Cobalt compound with neodymium (3:1)	12187-43-8	Intentional addition / 1,000ppm	chemical products
7577	Cobalt compound with samarium (3:1)	12187-46-1	Intentional addition / 1,000ppm	chemical products
7578	Cuprate(3-), [N,N-bis(2-bis(carboxymethyl)amino)ethylglycinate(5-)]-, trisodium, (OC-6-43)-	12189-76-3	Intentional addition / 1,000ppm	chemical products
7579	Cobaltate (CoO21-), lithium	12190-79-3	Intentional addition / 100ppm	chemical products
7580	Chromium titanium oxide (Cr2TiO5)	12190-87-3	1,000ppm	chemical products
7581	Chromium zinc oxide (Cr2Zn2O5)	12190-88-4	Intentional addition / 1,000ppm	chemical products
7582	Dichromium silicide	12190-91-9	1,000ppm	chemical products
7583	Cesium telluride (Cs2Te)	12191-06-9	Contains (regardless of intentional or impurities)	chemical products
7584	Aurothioglucose	12192-57-3	Intentional addition	chemical products
7585	(eta-5-Cyclopentadienyl)dicarbonylrhodium	12192-97-1	1,000ppm	chemical products
7586	Ammoniojarosite ((NH4)Fe3(OH)6(SO4)2)	12194-95-5	1%	chemical products
7587	Lanthanum compound with nickel (1:5)	12196-72-4	Contains (regardless of intentional or impurities)	chemical products
7588	Pentamanganese silicide	12196-74-6	Contains (regardless of intentional or impurities)	chemical products
7589	Vanadate (V10O286-), hexasodium	12200-88-3	Intentional addition / 1%	chemical products
7590	Zirconate (ZrO32-), disodium	12201-48-8	Contains (regardless of intentional or impurities)	chemical products
7591	Nickel selenide	12201-85-3	Contains (regardless of intentional or impurities)	chemical products
7592	Nickel silicide (NiSi2)	12201-89-7	Contains (regardless of intentional or impurities)	chemical products
7593	Aluminium chlorohydroxyallantoinate	12202-91-4	1%	chemical products
7594	Calcium manganese oxide silicate	12205-44-6	Contains (regardless of intentional or impurities)	chemical products
7595	Ammonium trivanadium octaoxide	12207-63-5	Contains (regardless of intentional or impurities)	chemical products
7596	Diammonium tridecaoxotetramolybdate(2-)	12207-64-6	Contains (regardless of intentional or impurities)	chemical products
7597	Manganese hydroxide (Mn(OH)4)	12207-67-9	1%	chemical products
7598	Molybdate(6-), hexatriaconta-μ-oxooctadeca-oxobis[μ,9-phosphato(3-)-O,O,O',O',O',O',O',O']octadeca-, hexahydrogen	12207-90-8	Contains (regardless of intentional or impurities)	chemical products
7599	Vanadate (V10O286-), hexaammonium	12208-00-3	Intentional addition / 1%	chemical products
7600	Potassium hexahydroxoantimonate	12208-13-8	Contains (regardless of intentional or impurities)	chemical products
7601	Tungstate (W7O246-), hexaammonium, hexahydrate	12208-54-7	1%	chemical products
7602	Lithium molybdenum oxide (Li4Mo5O12)	12209-17-5	1%	chemical products
7603	Lithium molybdenum oxide (Li6Mo2O7)	12209-18-6	1%	chemical products
7604	Disodium stannate, trihydrate	12209-98-2	Contains (regardless of intentional or impurities)	chemical products
7605	Rubidium telluride (Rb2Te)	12210-70-7	Contains (regardless of intentional or impurities)	chemical products
7606	Dizirconium silicide	12211-03-9	Contains (regardless of intentional or impurities)	chemical products
7607	Ammonium cyanide	12211-52-8	Contains (regardless of intentional or impurities)	chemical products
7608	Cadmium selenide sulfide (Cd2SeS)	12213-70-6	Contains (regardless of intentional or impurities)	chemical products
7609	Cadmium selenide sulfide (Cd2SeS)	12214-12-9	Contains (regardless of intentional or impurities)	chemical products
7610	Cerium compound with cobalt (1:5)	12214-13-0	Intentional addition / 1,000ppm	chemical products
7611	C.I. Acid Black 29	12217-14-0	1,000ppm	chemical products
7612	Acid Black 58	12218-94-9	Contains (regardless of intentional or impurities)	chemical products
7613	Chromate(1-), bis[N-(7-hydroxy-8-[[2-hydroxy-5-[[methylamino)sulfonyl]phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, hydrogen	12218-95-0	Contains (regardless of intentional or impurities)	chemical products
7614	C.I. Acid Black 107	12218-96-1	Contains (regardless of intentional or impurities)	chemical products
7615	Acid Black 131	12219-01-1	1,000ppm	chemical products
7616	C.I. Acid Black 132	12219-02-2	1,000ppm	chemical products
7617	C.I. Basic Red 42	12221-66-8	1,000ppm	chemical products
7618	Cuprate(4-), [μ,9-[[4,4'-[[3,3'-dihydroxy-1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[3-hydroxy-2,7-naphthalenedisulfonato]]8-]]di-, tetrasodium	12222-00-3	Intentional addition / 1,000ppm	chemical products
7619	C.I. Direct Blue 160	12222-02-5	Contains (regardless of intentional or impurities)	chemical products
7620	C.I. Direct Blue 199	12222-04-7	Contains (regardless of intentional or impurities)	chemical products
7621	Xanthylum, 9-[2-(ethoxycarbonyl)phenyl]-3,6-bis(ethylamino)-2,7-dimethyl-, molybdate tungstate phosphate	12224-98-5	1%	chemical products
7622	Cuprate(4-), [C-[[[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-2-sulfonyl]amino]sulfonyl]-29H,31H-phthalocyanine-C,C,C-trisulfonato(6-)-kappa.N29,kappa.N30,kappa.N31,kappa.N32]-, tetrasodium	12225-39-7	Intentional addition / 1,000ppm	chemical products
7623	C.I. Reactive Brown 7	12225-64-8	Contains (regardless of intentional or impurities)	chemical products
7624	Chromate(2-), [2-[[[4,5-dihydro-3-methyl-5-oxo-1-[4-[[1-oxo-2-propenyl]amino]phenyl]-1H-pyrazol-4-yl]azo]benzoato(2-)]][2-[[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-sulfo]benzoato(3-)]-, disodium	12226-00-5	Contains (regardless of intentional or impurities)	chemical products
7625	C.I. Reactive Violet 5	12226-38-9	Intentional addition / 1,000ppm	chemical products
7626	C.I. SOLVENT YELLOW 82	12227-67-7	1,000ppm	chemical products
7627	Boron monosulfide	12228-39-6	1%	chemical products
7628	Beryllium boride (BeB2)	12228-40-9	Contains (regardless of intentional or impurities)	chemical products
7629	Copper boride (Cu3B2)	12228-45-4	Intentional addition / 1,000ppm	chemical products
7630	Manganese boride (MnB2)	12228-50-1	Contains (regardless of intentional or impurities)	chemical products
7631	Tungsten boride (WB2)	12228-69-2	1%	chemical products
7632	Ammonium boron oxide	12228-87-4	1%	chemical products
7633	Boron manganese oxide (B4MnO7)	12228-91-0	Contains (regardless of intentional or impurities)	chemical products
7634	Manganese boride (Mn3B4)	12229-02-6	Contains (regardless of intentional or impurities)	chemical products
7635	Nickel boride (Ni3B4)	12229-03-7	Contains (regardless of intentional or impurities)	chemical products
7636	Potassium pentaborate octahydrate	12229-13-9	1%	chemical products
7637	Barium hexaborate tetrahydrate	12229-36-6	Intentional addition	chemical products
7638	Barium hexaborate trihydrate	12229-51-5	Intentional addition	chemical products
7639	Thorium boride (ThB6)	12229-63-9	1%	chemical products
7640	Gallium boride (GaB12)	12230-30-7	1%	chemical products
7641	Magnesium boride (MgB12)	12230-32-9	1%	chemical products
7642	Barium hydroxide octahydrate	12230-71-6	Contains (regardless of intentional or impurities)	chemical products
7643	Barium manganese oxide (BaMnO3)	12230-80-7	Contains (regardless of intentional or impurities)	chemical products
7644	Barium oxide (Ba2O)	12231-50-4	Intentional addition	chemical products
7645	Barium zirconium oxide (Ba2ZrO4)	12231-53-7	Intentional addition	chemical products
7646	Barium tantalum oxide (Ba5Ta4O15)	12231-98-0	Contains (regardless of intentional or impurities)	chemical products
7647	Beryllium selenide (BeSe)	12232-25-6	Contains (regardless of intentional or impurities)	chemical products
7648	Beryllium telluride (BeTe)	12232-27-8	Contains (regardless of intentional or impurities)	chemical products
7649	Beryllium compound with titanium (12:1)	12232-67-6	Contains (regardless of intentional or impurities)	chemical products
7650	Bismuth manganese oxide (BiMn2O5)	12232-96-1	Contains (regardless of intentional or impurities)	chemical products
7651	C.I. Direct Blue 173	12235-72-2	1,000ppm	chemical products
7652	C.I. Solvent Black 27	12237-22-8	Contains (regardless of intentional or impurities)	chemical products
7653	C.I. Pigment Violet 27	12237-62-6	Intentional addition / 1,000ppm	chemical products
7654	C.I. Pigment Red 169	12237-63-7	Intentional addition / 1,000ppm	chemical products
7655	Cuprate(3-), [C-[[[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-2-sulfonyl]amino]sulfonyl]-C-(aminosulfonyl)-29H,31H-phthalocyanine-C,C-disulfonato(5-)-N29,N30,N31,N32]-, trihydrogen	12238-09-4	Intentional addition / 1,000ppm	chemical products
7656	C.I. Pigment Red 52:2	12238-31-2	Contains (regardless of intentional or impurities)	chemical products
7657	Copper phthalocyanine monoether	12239-87-1	Intentional addition / 1,000ppm	chemical products
7658	Tricarbonyl(1,2,3,4,5,6-eta)-N-methylaniline]chromium	12241-41-7	1,000ppm	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
7789	Hafnium silicide (HfSi2)	12401-56-8	1%	chemical products
7790	Benzene, tetrachloro-	12408-10-5	Intentional addition / 100ppm	chemical products
7791	Dialuminium dibarium calcium hexaoxide	12408-43-4	Contains (regardless of intentional or impurities)	chemical products
7792	Zirconium boride (ZrB2)	12409-02-8	Contains (regardless of intentional or impurities)	chemical products
7793	Chromium boride (CrB4)	12409-08-4	1,000ppm	chemical products
7794	Iron chloride sulphate	12410-14-9	1%	chemical products
7795	Molybdate (MoO264-) tetraammonium	12411-64-2	Contains (regardless of intentional or impurities)	chemical products
7796	Arsenopyrite, cobaltoan	12414-94-7	Intentional addition / 1,000ppm	chemical products
7797	Arsenargenite (Ag3As)	12417-99-1	Contains (regardless of intentional or impurities)	chemical products
7798	Molybdenum boride (Mo2B3)	12421-54-4	Contains (regardless of intentional or impurities)	chemical products
7799	Bismuth compound with yttrium (1:1)	12421-98-8	Intentional addition / 1%	chemical products
7800	Manganese	12427-38-2	Contains (regardless of intentional or impurities)	chemical products
7801	Cobaltocenium hexafluorophosphate(1-)	12427-42-6	Intentional addition / 1,000ppm	chemical products
7802	Boron magnesium oxide (B6MgO10)	12429-66-2	1%	chemical products
7803	Beryllium boride (BeB6) (OC-6-11)	12429-94-6	Contains (regardless of intentional or impurities)	chemical products
7804	Titanate (TiO32-) barium strontium (2:1:1)	12430-73-8	Contains (regardless of intentional or impurities)	chemical products
7805	Cerium compound with iron (1:5)	12432-30-3	1%	chemical products
7806	Tricopper chromate tetrahydroxide	12433-14-6	Contains (regardless of intentional or impurities)	chemical products
7807	Chromium lanthanum oxide (CrLaO4)	12433-24-8	Intentional addition / 1,000ppm	chemical products
7808	(Dioxochromium)di-mu-oxodioxouranium (CrUO6)	12433-30-6	Intentional addition / 1,000ppm	chemical products
7809	Potassium zinc chromate oxide (K2Zn4(CrO4)4O)	12433-50-0	Contains (regardless of intentional or impurities)	chemical products
7810	Copper compound with samarium (6:1)	12433-90-8	Intentional addition / 1,000ppm	chemical products
7811	Manganese yttrium oxide (Mn2Y05)	12438-71-0	Contains (regardless of intentional or impurities)	chemical products
7812	Vanadium oxosulfato-, pentahydrate	12439-96-2	Intentional addition / 1%	chemical products
7813	Cadmium zinc sulfide ((Cd,Zn)S)	12442-27-2	Contains (regardless of intentional or impurities)	chemical products
7814	Trihydrogen mu-hydroxydihydroxybis(mu-[orthoborato(3)-O-O])diborate	12447-38-0	1%	chemical products
7815	Titanium boride (Ti2B5)	12447-59-5	1%	chemical products
7816	Zinc borate, hydrated	12447-61-9	Intentional addition / 1%	chemical products
7817	Disilver dodecaiodododecaborate(2-)	12448-25-8	Intentional addition / 1%	chemical products
7818	Molybdenum potassium oxide (Mo4K2O13)	12500-91-3	1%	chemical products
7819	Heptamanganese hexaoxide silicate	12502-82-8	Contains (regardless of intentional or impurities)	chemical products
7820	Antimony compound with nickel (1:3)	12503-49-0	Contains (regardless of intentional or impurities)	chemical products
7821	Heptanickel hexasulphide	12503-53-6	Contains (regardless of intentional or impurities)	chemical products
7822	Zirconate(2-), oxodisulfato-, dihydrogen, trihydrate	12503-89-8	Contains (regardless of intentional or impurities)	chemical products
7823	Boron monoxide	12505-77-0	1%	chemical products
7824	Barium silicon oxide (Ba3Si5O13)	12507-96-9	Intentional addition	chemical products
7825	Erionite	12510-42-8	Contains (regardless of intentional or impurities)	chemical products
7826	Zinc arsenide (ZnAs)	12511-97-6	Intentional addition / 1,000ppm	chemical products
7827	Boron silver oxide (B4Ag2O7), hydrate	12513-18-7	Intentional addition / 1%	chemical products
7828	Cerium compound with cobalt (2:7)	12515-29-6	Intentional addition / 1,000ppm	chemical products
7829	Cerium tin oxide (Ce2Sn2O7)	12515-32-1	Contains (regardless of intentional or impurities)	chemical products
7830	Cobalt compound with neodymium (7:2)	12516-51-7	Intentional addition / 1,000ppm	chemical products
7831	Cobalt compound with praseodymium (7:2)	12516-52-8	Intentional addition / 1,000ppm	chemical products
7832	Iron molybdenum oxide (Fe2Mo3O8)	12518-76-2	1%	chemical products
7833	Molybdenum hydroxide oxide phosphate (Mo10(OH)3O27(PO4))	12519-76-5	Contains (regardless of intentional or impurities)	chemical products
7834	Trihydrogen hydroxybis(orthosilicate(4-))trinitricelate(3-)	12519-85-6	Contains (regardless of intentional or impurities)	chemical products
7835	Hydrogen fluoride (HF2)	12520-88-6	5%	chemical products
7836	Magnesium molybdenum oxide (Mg2Mo3O8)	12521-67-4	1%	chemical products
7837	Hydrogen fluoride (HF2)	12528-21-1	Contains (regardless of intentional or impurities)	chemical products
7838	Nickel selenide (Ni3Se4)	12534-09-7	Contains (regardless of intentional or impurities)	chemical products
7839	Zirconate (ZrO32-), dirubidium	12534-23-5	Contains (regardless of intentional or impurities)	chemical products
7840	1,3,5,7,2,4,6,8-Tetraoxatetraannocane	12534-33-7	Contains (regardless of intentional or impurities)	chemical products
7841	Beryllium boride (Be2B)	12536-51-5	Contains (regardless of intentional or impurities)	chemical products
7842	Beryllium boride (Be4B)	12536-52-6	Contains (regardless of intentional or impurities)	chemical products
7843	Barium titanium oxide (Ba6Ti17O40)	12537-49-4	Intentional addition	chemical products
7844	Boron carbide (B2C)	12537-86-9	1%	chemical products
7845	[Carbonato(2-)]tetrahydroxyoxidizirconium	12538-92-0	Contains (regardless of intentional or impurities)	chemical products
7846	Boron carbide (BC2)	12539-98-9	1%	chemical products
7847	Boron carbide (B11C2)	12540-04-4	1%	chemical products
7848	Copper acetylide	12540-13-5	Intentional addition / 1,000ppm	chemical products
7849	Methyl aluminum sesquichloride	12542-85-7	Contains (regardless of intentional or impurities)	chemical products
7850	Molybdenum carbide (MoC3)	12543-74-7	1%	chemical products
7851	Ferrate(4-), hexakis(cyano-kappa-C)- cobalt(2+) potassium (1:1:2), (OC-6-11)-	12549-23-4	1,000ppm	chemical products
7852	Sodium [D-gluconato(4-)]antimonate(1-)	12550-17-3	Contains (regardless of intentional or impurities)	chemical products
7853	Dihydrogen heptaacetateborate(2-), compound with cyclohexylamine (1:1)	12550-98-0	1%	chemical products
7854	Chromium carbide (Cr3C7)	12552-55-5	1,000ppm	chemical products
7855	Manganese bis(2-xi)-D-gluco-heptonato-	12565-60-5	Contains (regardless of intentional or impurities)	chemical products
7856	Boron nitride (B3N)	12589-11-6	1%	chemical products
7857	Holmium boride (HoB12)	12589-37-6	1%	chemical products
7858	Barium digallium tetrasulphide	12589-46-7	Contains (regardless of intentional or impurities)	chemical products
7859	Hydrogen fluoride (H2F)	12592-22-2	1%	chemical products
7860	Molybdenum sodium oxide (Mo6NaO17)	12594-27-3	1%	chemical products
7861	Tetraatomic tellurium	12597-49-8	Contains (regardless of intentional or impurities)	chemical products
7862	Bronze	12597-70-5	Intentional addition / 1,000ppm	chemical products
7863	Brass	12597-71-6	Intentional addition / 1,000ppm	chemical products
7864	Silver compound with tin (1:1)	12597-76-1	Contains (regardless of intentional or impurities)	chemical products
7865	Cobalt carbonate hydroxide (Co5(CO3)2(OH)6)	12602-23-2	Intentional addition / 1,000ppm	chemical products
7866	Boron carbide (BC3)	12602-45-8	1%	chemical products
7867	Ferro-manganese alloy	12604-53-4	Contains (regardless of intentional or impurities)	chemical products
7868	Ferrovandium	12604-58-9	Contains (regardless of intentional or impurities)	chemical products
7869	Nickel alloy, base, Ni,Al,Co,Cr,Mo,Ti (IN 731)	12604-68-1	Contains (regardless of intentional or impurities)	chemical products
7870	Nickel alloy, base, Ni 57-62,Fe 22-28,Cr 14-18,Si 0.75-1.6,Mn 0-1.0,C 0-0.15,S 0-0.01 (UNS N06004)	12605-70-8	Contains (regardless of intentional or impurities)	chemical products
7871	Nickel, [carbonato(2-)]tetrahydroxytri-	12607-70-4	Contains (regardless of intentional or impurities)	chemical products
7872	1,1,1'-Isopropylidenediferrocene	12609-95-9	1%	chemical products
7873	Arsenic sulphides	12612-21-4	1,000ppm	chemical products
7874	Molybdenum sulfide	12612-50-9	1%	chemical products
7875	Nickel carbonyl	12612-55-4	1,000ppm	chemical products
7876	Cobalt boride	12619-68-0	Intentional addition / 1%	chemical products
7877	Nickel boride	12619-90-8	Contains (regardless of intentional or impurities)	chemical products
7878	Arsenic selenide	12626-31-2	Contains (regardless of intentional or impurities)	chemical products
7879	Cadmium selenide sulfide (Cd(Se,S))	12626-36-7	Contains (regardless of intentional or impurities)	chemical products
7880	Chromium hydroxide	12626-43-6	1,000ppm	chemical products
7881	Chromium silicide	12626-44-7	1,000ppm	chemical products
7882	Manganese hydroxide	12626-88-9	Contains (regardless of intentional or impurities)	chemical products
7883	Molybdenum boride	12626-91-4	1%	chemical products
7884	Tungsten boride	12627-39-3	1%	chemical products
7885	Molybdenum carbide	12627-57-5	1%	chemical products
7886	Cobalt-chromium-molybdenum alloy	12629-02-6	Intentional addition / 1,000ppm	chemical products
7887	Sodium pentaborate penta-hydrate (Na2B10O16.5H2O)	12631-71-9	1%	chemical products
7888	Nickel alloy, base, Ni,Al	12635-29-9	Contains (regardless of intentional or impurities)	chemical products
7889	Cobalt-chromium-nickel-tungsten alloy	12638-07-2	Contains (regardless of intentional or impurities)	chemical products
7890	Cobalt-molybdenum oxide	12640-46-9	Intentional addition / 1%	chemical products
7891	Selenium oxides	12640-89-0	Contains (regardless of intentional or impurities)	chemical products
7892	Aroclor 5442	12642-23-8	Intentional addition / 100ppm	chemical products
7893	Barium titanium oxide	12642-89-6	Intentional addition	chemical products
7894	Copper phosphide	12643-19-5	Intentional addition / 1,000ppm	chemical products
7895	Tetrachromium nitride	12645-11-3	1,000ppm	chemical products
7896	Iron manganese zinc oxide	12645-49-7	Contains (regardless of intentional or impurities)	chemical products
7897	Iron nickel zinc oxide	12645-50-0	Contains (regardless of intentional or impurities)	chemical products
7898	Manganese nitride	12646-17-2	Contains (regardless of intentional or impurities)	chemical products
7899	Silicic acid, barium salt	12650-28-1	Intentional addition / 1,000ppm	chemical products
7900	Titanium zinc oxide	12651-25-1	Intentional addition / 1,000ppm	chemical products
7901	Chromium boride	12653-55-3	1,000ppm	chemical products
7902	Cobalt sulfides	12653-56-4	Intentional addition / 1%	chemical products
7903	Nickel titanium oxide	12653-76-8	Contains (regardless of intentional or impurities)	chemical products
7904	Vanadium boride	12653-88-2	Intentional addition / 1%	chemical products
7905	Antimonate(2-), bis[mu-[2,3-dihydroxybutanedioato(4-)-O1,O2,O3,O4]]di-, barium (1:1), stereoisomer	12655-04-8	Contains (regardless of intentional or impurities)	chemical products
7906	Dihydrogen bis[mu-[tartrato(4-)-O1,O2,O3,O4]]diantimonate(2-), stereoisomer	12655-06-0	Contains (regardless of intentional or impurities)	chemical products
7907	C.I. Pigment Orange 20	12656-57-4	Contains (regardless of intentional or impurities)	chemical products
7908	Nickel alloy, base, Ni 60,Cr 40	12661-84-6	Contains (regardless of intentional or impurities)	chemical products
7909	Aluminum cobalt oxide	12672-27-4	Intentional addition / 1,000ppm	chemical products
7910	Cobalt hydroxide	12672-51-4	Intentional addition / 1,000ppm	chemical products
7911	Indium chloride	12672-70-7	1%	chemical products
7912	Indium oxide	12672-71-8	1%	chemical products
7913	Molybdenum nickel oxide	12673-58-4	Contains (regardless of intentional or impurities)	chemical products
7914	Antimony tin oxide	12673-86-8	Contains (regardless of intentional or impurities)	chemical products
7915	Titanium boride	12673-91-5	1%	chemical products
7916	High nickel alloys	12675-92-2	Contains (regardless of intentional or impurities)	chemical products
7917	Sodium barium niobate	12676-22-1	Intentional addition / 1,000ppm	chemical products
7918	Silicon boride oxide	12676-29-8	1%	chemical products
7919	Rhodium oxide	12680-36-3	1%	chemical products
7920	Chromium sodium oxide	12680-48-7	Contains (regardless of intentional or impurities)	chemical products
7921	Molybdenum sodium oxide	12680-49-8	1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
7922	Cadmium-copper alloy	12685-29-9	Contains (regardless of intentional or impurities)	chemical products
7923	Manganese sulfide	12687-82-0	1%	chemical products
7924	Zirconium hydroxide	12688-15-2	Contains (regardless of intentional or impurities)	chemical products
7925	Lutetium boride (LuB4) (T-4)-	12688-52-7	1%	chemical products
7926	Barium titanium oxide (BaTi6O13)	12688-62-9	Intentional addition	chemical products
7927	Bismuth compound with nickel (1:1)	12688-64-1	Contains (regardless of intentional or impurities)	chemical products
7928	Gallium ditelluride	12689-99-5	Contains (regardless of intentional or impurities)	chemical products
7929	Ammonium phosphomolybdate	12704-86-8	1%	chemical products
7930	Nickel carbide	12710-36-0	Contains (regardless of intentional or impurities)	chemical products
7931	Boric acid, potassium salt	12712-38-8	1%	chemical products
7932	Umbel	12713-03-0	Contains (regardless of intentional or impurities)	chemical products
7933	Zirconium carbide nitride	12713-24-5	Contains (regardless of intentional or impurities)	chemical products
7934	Cobaltate(2-), bis[2-[[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-], dihydrogen	12715-61-6	Intentional addition / 1,000ppm	chemical products
7935	Tungsten carbide, mixed with cobalt (92%:8%)	12718-89-3	1%	chemical products
7936	Triacetoxystibine oxide	12737-02-9	Contains (regardless of intentional or impurities)	chemical products
7937	Barium manganese oxide	12737-09-6	Contains (regardless of intentional or impurities)	chemical products
7938	Chromium iron oxide	12737-27-8	Contains (regardless of intentional or impurities)	chemical products
7939	Cobalt nickel oxide	12737-30-3	Contains (regardless of intentional or impurities)	chemical products
7940	Manganese bromide	12738-03-3	Contains (regardless of intentional or impurities)	chemical products
7941	Titanium molybdate	12738-08-8	1%	chemical products
7942	Silicic acid, sodium zirconium salt	12738-56-6	Contains (regardless of intentional or impurities)	chemical products
7943	Tin sulfide	12738-87-3	Intentional addition / 1,000ppm	chemical products
7944	Zirconium boride	12741-10-5	Contains (regardless of intentional or impurities)	chemical products
7945	Zirconium alloy, base	12742-60-8	Contains (regardless of intentional or impurities)	chemical products
7946	Boron zinc oxide (B6Zn2O11)	12767-90-7	Intentional addition / 1,000ppm	chemical products
7947	Copper, 3-hydroxy-4-[[2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonic acid complex	12769-07-2	Intentional addition / 1,000ppm	chemical products
7948	Cuprate(3-), [5-(acetyl amino)-4-hydroxy-3-[[2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(5-)]-, trisodium	12769-08-3	Intentional addition / 1,000ppm	chemical products
7949	Hafnium hydride (HFH2)	12770-26-2	1%	chemical products
7950	Beryllium aluminum alloy	12770-50-2	Contains (regardless of intentional or impurities)	chemical products
7951	Copper arsenate hydroxide (Cu2(AsO4)(OH))	12774-48-0	Contains (regardless of intentional or impurities)	chemical products
7952	Arsenic oxide	12777-38-7	Contains (regardless of intentional or impurities)	chemical products
7953	Bismuth tin oxide	12777-45-6	Intentional addition / 1,000ppm	chemical products
7954	Boron phosphide	12777-46-7	1%	chemical products
7955	Lanthanum chromate	12777-94-5	Contains (regardless of intentional or impurities)	chemical products
7956	Scandium hexaboride	12785-49-8	1%	chemical products
7957	Iron, bis((2-xi)-D-gluco-heptonato)-	12786-09-3	1%	chemical products
7958	Antimony dioxide	12786-74-2	Contains (regardless of intentional or impurities)	chemical products
7959	Aluminum borate silicate	12788-79-3	1%	chemical products
7960	Dichlorobis(cyclopentadienyl)molybdenum tetrafluoroborate	12793-13-4	1%	chemical products
7961	Bis(1-nitroso-2-naphtholato)nickel	12794-26-2	Contains (regardless of intentional or impurities)	chemical products
7962	Copper telluride	12795-09-4	Contains (regardless of intentional or impurities)	chemical products
7963	Nickel arsenide	12795-30-1	Contains (regardless of intentional or impurities)	chemical products
7964	Yttrium silicate	12797-68-1	1%	chemical products
7965	Nickel(2+) oleate	13001-15-5	Contains (regardless of intentional or impurities)	chemical products
7966	Copper D-gluconate	13005-35-1	Intentional addition / 1,000ppm	chemical products
7967	Aurate(1-), tetrachloro-, potassium dihydrate, (SP-4-1)-	13005-39-5	Intentional addition	chemical products
7968	Dicarbonylbis(triphenylphosphine)nickel	13007-90-4	Contains (regardless of intentional or impurities)	chemical products
7969	Chromium carbonyl	13007-92-6	Contains (regardless of intentional or impurities)	chemical products
7970	Cuprate(4-), bis[5-hydroxy-5,7-quinolinedisulfonato(3-)-N1,O8]-, tetrahydrogen, compound with N-ethylmethanamine	13007-93-7	Intentional addition / 1,000ppm	chemical products
7971	Cobaltate(1-), bis[2-[[2-hydroxy-5-nitrophenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-, hydrogen	13011-62-6	Intentional addition / 1,000ppm	chemical products
7972	Chromate(1-), bis[5-[[5-chloro-2-hydroxyphenyl]azo]-6-hydroxy-2-naphthalenesulfonamido(2-)]-, hydrogen	13011-65-9	Contains (regardless of intentional or impurities)	chemical products
7973	Sodium [3-[[3-[[3-amino-4-nitrophenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulphonato(3-)]cuprate(1-)	13011-68-2	Intentional addition / 1,000ppm	chemical products
7974	Cuprate(4-), [mu-[[[5-[[5-carbonylbis(imino(2-hydroxy-5-sulfo-4,1-phenylene)azo)]bis(6-hydroxy-2-naphthalenesulfonato)](8-)]di]-, tetraammonium	13011-70-6	Intentional addition / 1,000ppm	chemical products
7975	3,7-Bis(dimethylamino)phenothiazin-5-ium perchlorate	13018-79-6	1,000ppm	chemical products
7976	N-(2-Pyridyl)dithio carbamic acid methyl ester	13037-46-2	Contains (regardless of intentional or impurities)	chemical products
7977	1,6-Hexanediol diacrylate	13048-33-4	Contains (regardless of intentional or impurities)	chemical products
7978	1,1'-Biphenyl, 2,2'-diethyl-	13049-35-9	Intentional addition / 1%	chemical products
7979	1,1'-Biphenyl, 2,3'-diethyl-	13049-36-0	Intentional addition / 1%	chemical products
7980	1,1'-Biphenyl, 2,4'-diethyl-	13049-37-1	Intentional addition / 1%	chemical products
7981	1,1'-Biphenyl, 3,3'-diethyl-	13049-38-2	Intentional addition / 1%	chemical products
7982	1,1'-Biphenyl, 3,4'-diethyl-	13049-39-3	Intentional addition / 1%	chemical products
7983	Hexanedioic acid, 2,5'-diethyl-	13049-40-6	Intentional addition / 1%	chemical products
7984	Hexanoic acid, 2,3,3,4,4,5,5,6,6,6-decafluoro-2-(1,1,2,2,2-pentafluoroethyl)-, ammonium salt (1:1)	13058-06-5	Intentional addition / 100ppm	chemical products
7985	1,1,5-Trichloropentane	13059-14-8	1,000ppm	chemical products
7986	Dichlorotrimethylantimony	13059-67-1	Contains (regardless of intentional or impurities)	chemical products
7987	Methylboronic acid	13061-96-6	1%	chemical products
7988	Dichloromalononitrile	13063-43-9	Intentional addition	chemical products
7989	Benzonitrile, p-hydroxy-, O-ester with O-ethyl phenylphosphonothioate	13067-93-1	Contains (regardless of intentional or impurities)	chemical products
7990	S-tert-Butylthiomethyl O,O-diethylphosphorodithioate	13071-79-9	Contains (regardless of intentional or impurities)	chemical products
7991	Trichloro(dimethylamine)boron	13072-44-1	1%	chemical products
7992	Indium(III) cyanide	13074-68-5	Contains (regardless of intentional or impurities)	chemical products
7993	Nonanoic acid, cobalt(2+) salt	13078-49-4	Intentional addition / 1%	chemical products
7994	Decanoic acid, barium salt	13088-41-4	Contains (regardless of intentional or impurities)	chemical products
7995	Heptanoic acid, barium salt	13101-62-7	Intentional addition / 1,000ppm	chemical products
7996	Tetrasodium [4-acetamido-5-hydroxy-6-[[2-hydroxy-4-[[4-[2-[4-(4-methoxyphenyl)azo]-2-sulphophenyl]vinyl]-3-sulphophenyl]azo]-6-sulpho-1-naphthyl]azo]naphthalene-1-sulphonato(6-)]cuprate(4-)	13102-26-6	Intentional addition / 1,000ppm	chemical products
7997	Beryllium carbonate	13106-47-3	Contains (regardless of intentional or impurities)	chemical products
7998	Diammonium molybdate ((NH4)2MoO4)	13106-76-8	Contains (regardless of intentional or impurities)	chemical products
7999	Propane, 1,2,3,3-tetrachloro-	13116-53-5	1,000ppm	chemical products
8000	Cyhexatin	13121-70-5	Contains (regardless of intentional or impurities)	chemical products
8001	Bis(tricyclohexyltin) sulfide	13121-76-1	Intentional addition / 1,000ppm	chemical products
8002	Nickel(II) nitrate	13138-45-9	Contains (regardless of intentional or impurities)	chemical products
8003	1-Hexene, 1-bromo-, (Z)-	13154-12-6	1,000ppm	chemical products
8004	1-Hexene, 1-bromo-, (E)-	13154-13-7	1,000ppm	chemical products
8005	Xanthylum, 9-[2-(ethoxycarbonyl)phenyl]-3,6-bis(ethylamino)-2,7-dimethyl-, perchlorate	13161-28-9	1,000ppm	chemical products
8006	Direct Orange 1	13164-83-7	Contains (regardless of intentional or impurities)	chemical products
8007	Isopropylidene propane dinitrile	13166-10-4	Intentional addition	chemical products
8008	Phosphamidin	13171-21-6	Contains (regardless of intentional or impurities)	chemical products
8009	3,8,10-Trioxa-9-stannatetradeca-5,12-dien-14-oiic acid, 9,9-dibutyl-4,7,11-trioxo-, ethyl ester, (Z,Z)-	13173-04-1	Contains (regardless of intentional or impurities)	chemical products
8010	2-Bromododecane	13187-99-0	1,000ppm	chemical products
8011	Ethoprophos	13194-48-4	Contains (regardless of intentional or impurities)	chemical products
8012	Cuprate(2-), [4-bis[4-(diethylamino)phenyl]hydroxymethyl]-5-[[4,5-dihydro-3-methyl-5-(oxo-kappa O)-1-phenyl-1H-pyrazol-4-yl]azo-kappa N1]-6-(hydroxy-kappa O)-1,3-benzenedisulfonato(4-)]-, disodium	13194-92-8	Intentional addition / 1,000ppm	chemical products
8013	Boric acid (H3BO3), tris(2-methylpropyl) ester	13195-76-1	1%	chemical products
8014	1-Propene, 1,1-dibromo-	13195-80-7	1,000ppm	chemical products
8015	Borane carbonyl	13205-44-2	1%	chemical products
8016	Cuprate(4-), [mu-[[4-bis[[6-[[3-carboxyphenyl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo][1,1'-biphenyl]-3,3'-dicarboxylato(8-)]di]-, tetrasodium	13217-74-8	Intentional addition / 1,000ppm	chemical products
8017	Chromate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamido(2-)]-	13221-10-8	Contains (regardless of intentional or impurities)	chemical products
8018	Nitric acid, manganese salt	13224-08-3	Contains (regardless of intentional or impurities)	chemical products
8019	Plumbane, dichlorodiethyl-	13231-90-8	Contains (regardless of intentional or impurities)	chemical products
8020	Stannane, bis(formyloxy)dimethyl-	13241-48-0	Intentional addition / 1,000ppm	chemical products
8021	Zirconium tetraphenolate	13242-21-2	Contains (regardless of intentional or impurities)	chemical products
8022	o-Phenylenebis(dimethylarsine)	13246-32-7	Contains (regardless of intentional or impurities)	chemical products
8023	1-Octene, 2-bromo-	13249-60-0	1,000ppm	chemical products
8024	Silicic acid (H2SiO3), barium salt (1:1)	13255-26-0	Contains (regardless of intentional or impurities)	chemical products
8025	Plumbane, (acetyloxy)tripropyl-	13266-07-4	Contains (regardless of intentional or impurities)	chemical products
8026	Ethanedioic acid, ammonium iron(3+) salt	13268-42-3	Intentional addition / 1,000ppm	chemical products
8027	Stannane, dimethylthioxo-	13269-74-4	Contains (regardless of intentional or impurities)	chemical products
8028	1,1,1,3-Tetrachlorobutane	13275-19-9	1,000ppm	chemical products
8029	Octane, 1,1,1-trichloro-3,5-dimethyl-	13275-21-3	1,000ppm	chemical products
8030	Aminetriphenylboron	13276-04-5	1%	chemical products
8031	1,1,1-Trichlorobutane	13279-85-1	1,000ppm	chemical products
8032	1,1,3-Trichlorobutane	13279-87-3	1,000ppm	chemical products
8033	Tungsten chloride (WCl6), (OC-6-11)-	13283-01-7	1%	chemical products
8034	Borane(3)	13283-31-3	1%	chemical products
8035	Pent-2-enitrile	13284-42-9	Intentional addition	chemical products
8036	S-Benzyl O,O-diethyl phosphorothioate	13286-32-3	Intentional addition	chemical products
8037	Boron, trihydrothiobis(methane)]-, (T-4)-	13292-87-0	1%	chemical products
8038	Tin, bis(acetyloxy)dimethyl-	13293-57-7	Intentional addition / 1,000ppm	chemical products
8039	2-Butene, 2-bromo-	13294-71-8	1,000ppm	chemical products
8040	tributyltin methanesulphonate	13302-06-2	Contains (regardless of intentional or impurities)	chemical products
8041	Stannane, ((methylsulfonyloxy)triphenyl-	13302-08-4	Contains (regardless of intentional or impurities)	chemical products
8042	Oleic acid, chromium salt	13308-40-2	1,000ppm	chemical products
8043	Boron phosphite (B(P(O)4)	13308-51-5	1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
8044	Borane, chlorobis(2-methylpropyl)-	13317-64-1	1%	chemical products
8045	Boron trifluoride dihydrate	13319-75-0	Contains (regardless of intentional or impurities)	chemical products
8046	Nickel chloride (NiCl <sub>2</sub> )	13319-83-0	Contains (regardless of intentional or impurities)	chemical products
8047	Molybdenum chloride (MoCl <sub>4</sub> )	13320-71-3	Contains (regardless of intentional or impurities)	chemical products
8048	Stannane, dibutylbis(1-oxo-9-octadecenyloxy)-, (Z,Z)-	13323-62-1	Contains (regardless of intentional or impurities)	chemical products
8049	Dibutylbis(palmitoyloxy)stannane	13323-63-2	Contains (regardless of intentional or impurities)	chemical products
8050	Beryllium hydroxide	13331-23-2	Contains (regardless of intentional or impurities)	chemical products
8051	2-Furyboronic acid	13331-23-2	1%	chemical products
8052	Boric acid, (3-nitrophenyl)-	13331-27-6	1%	chemical products
8053	Tributyltin Acrylate	13331-52-7	Contains (regardless of intentional or impurities)	chemical products
8054	1-Butanamine, compound with trifluoroborane (1:1)	13331-55-0	1%	chemical products
8055	3,4,5-Trimethoxyphenylacetone	13338-83-1	Contains (regardless of intentional or impurities)	chemical products
8056	Tellurium tetrakis(dibutylcarbamodithioato-S,S)-	13344-46-2	Contains (regardless of intentional or impurities)	chemical products
8057	1-Butene, 1-bromo-3-dimethyl-	13352-80-2	1,000ppm	chemical products
8058	2-Heptene, 3-bromo-2-methyl-	13353-09-8	1,000ppm	chemical products
8059	Melarsenyl potassium	13355-00-5	Contains (regardless of intentional or impurities)	chemical products
8060	Stannane, butylchlorodihydroxy-	13355-96-9	Contains (regardless of intentional or impurities)	chemical products
8061	Fenbutatin oxide	13356-08-6	Contains (regardless of intentional or impurities)	chemical products
8062	Pentane, 1-bromo-2,2,4-trimethyl-	13356-11-1	1,000ppm	chemical products
8063	Monocetyl tin oxide	13356-20-2	Contains (regardless of intentional or impurities)	chemical products
8064	Dimethylsulfamoyl chloride	13360-57-1	Contains (regardless of intentional or impurities)	chemical products
8065	Isopropyl cyanoacetate	13361-30-3	Intentional addition	chemical products
8066	Acetic acid, cyano-, 2-methylpropyl ester	13361-31-4	Intentional addition	chemical products
8067	Allyl cyanoacetate	13361-32-5	Intentional addition	chemical products
8068	Acetic acid, cyano-, 2-ethylhexyl ester	13361-34-7	Intentional addition	chemical products
8069	Triphenyltin sulfamate	13362-00-0	Contains (regardless of intentional or impurities)	chemical products
8070	Thiobis(methylarsine), anhydrosulphide	13367-92-5	Contains (regardless of intentional or impurities)	chemical products
8071	(+)-3-Methylcyclohexanone	13368-65-5	1,000ppm	chemical products
8072	Tributyl(13-isopropylpodocarpa-7,13-dien-15-oyl)tin	13387-91-2	Contains (regardless of intentional or impurities)	chemical products
8073	Copper, bis(2,4-pentanedionato-O <sup>2-</sup> ), (SP-4-1)-	13395-16-9	Intentional addition / 1,000ppm	chemical products
8074	Cesium fluoride (CsF)	13400-13-0	Contains (regardless of intentional or impurities)	chemical products
8075	Ferrate(3-), hexakis(cyano-kappa-C)-, (OC-6-11)-	13408-62-3	Contains (regardless of intentional or impurities)	chemical products
8076	Tris(ethylenediamine)nickel(II) chloride	13408-70-3	Contains (regardless of intentional or impurities)	chemical products
8077	Cobalt(3+), tris(1,2-ethanediamine-N,N'-), trichloride, (OC-6-11)-	13408-73-6	Intentional addition / 1,000ppm	chemical products
8078	Cobalamin (1+)	13408-78-1	Intentional addition / 1%	chemical products
8079	Sodium selenate	13410-01-0	Contains (regardless of intentional or impurities)	chemical products
8080	Hexaoxididistannathiane	13413-18-8	Contains (regardless of intentional or impurities)	chemical products
8081	Ethanedioic acid, scandium(3+) salt (3:2)	13419-51-7	Intentional addition / 1,000ppm	chemical products
8082	1-Propanol, 2-methyl-, zirconium(4+) salt	13421-85-7	Contains (regardless of intentional or impurities)	chemical products
8083	Hydroxocobalamin	13422-51-0	Intentional addition / 1%	chemical products
8084	Aquocobalamin	13422-52-1	Intentional addition / 1%	chemical products
8085	Mecobalamin	13422-55-4	Intentional addition / 1%	chemical products
8086	Chromic acid (H <sub>2</sub> CrO <sub>4</sub> ), magnesium salt (1:1)	13423-61-5	Contains (regardless of intentional or impurities)	chemical products
8087	Copper(2+), bis(1,2-ethanediamine-N,N')	13426-91-0	Contains (regardless of intentional or impurities)	chemical products
8088	Tetrakis-ethoxide hafnium	13428-80-3	Intentional addition / 1%	chemical products
8089	1-(2-Methoxypropoxy)propan-2-ol	13429-07-7	Intentional addition / 1%	chemical products
8090	Antimonic acid (H <sub>3</sub> SbO <sub>3</sub> ), tris(2,3-dibromopropyl) ester	13433-92-6	Contains (regardless of intentional or impurities)	chemical products
8091	Hexanoic acid, 2-ethyl-, manganese(2+) salt	13434-24-7	Contains (regardless of intentional or impurities)	chemical products
8092	5,5,9,9-tetrabutyl-7-[(tributylstannyl)oxy]-6,8-dioxo-7-phospha-5,9-distannatridecane 7-oxide	13435-05-7	Contains (regardless of intentional or impurities)	chemical products
8093	Tetraethylammonium cyanide	13435-20-6	Contains (regardless of intentional or impurities)	chemical products
8094	2,5-Cyclohexadiene-1,4-dione, 2,5-dichloro-3,6-dihydroxy-, barium salt (1:1)	13435-46-6	Contains (regardless of intentional or impurities)	chemical products
8095	Sulfuric acid, manganese(3+) salt (3:2)	13444-72-9	Contains (regardless of intentional or impurities)	chemical products
8096	Nitrogen triiodide	13444-85-4	Intentional addition / 1,000ppm	chemical products
8097	Manganese bromide (MnBr <sub>2</sub> )	13446-03-2	Contains (regardless of intentional or impurities)	chemical products
8098	Ammonium permanganate	13446-10-1	Contains (regardless of intentional or impurities)	chemical products
8099	Magnesium permanganate hydrate	13446-20-3	Contains (regardless of intentional or impurities)	chemical products
8100	Magnesium selenate hexahydrate	13446-28-1	Intentional addition / 1,000ppm	chemical products
8101	Manganese chloride (MnCl <sub>2</sub> ), tetrahydrate	13446-34-9	Contains (regardless of intentional or impurities)	chemical products
8102	Manganese chloride (MnCl <sub>4</sub> )	13446-35-0	Contains (regardless of intentional or impurities)	chemical products
8103	Diphosphoric acid, manganese(2+) salt (1:2)	13446-44-1	Contains (regardless of intentional or impurities)	chemical products
8104	Nitrous acid, ammonium salt	13446-48-5	Contains (regardless of intentional or impurities)	chemical products
8105	Molybdate, (MoO <sub>4</sub> ) <sup>2-</sup> , dipotassium, (T-4)-	13446-49-6	Contains (regardless of intentional or impurities)	chemical products
8106	Molybdenum bromide (MoBr <sub>3</sub> )	13446-57-6	Contains (regardless of intentional or impurities)	chemical products
8107	Rubidium chromate	13446-72-5	Contains (regardless of intentional or impurities)	chemical products
8108	Rubidium dichromate	13446-73-6	Contains (regardless of intentional or impurities)	chemical products
8109	Strontium perchlorate	13450-97-0	Contains (regardless of intentional or impurities)	chemical products
8110	Tellurium oxide (TeO <sub>3</sub> )	13451-18-8	Contains (regardless of intentional or impurities)	chemical products
8111	Ammonium tellurate	13453-06-0	Contains (regardless of intentional or impurities)	chemical products
8112	Gold chloride (AuCl <sub>3</sub> )	13453-07-1	Intentional addition	chemical products
8113	Diarsenic acid	13453-15-1	Contains (regardless of intentional or impurities)	chemical products
8114	Gold triiodide	13453-24-2	Intentional addition / 1,000ppm	chemical products
8115	Thallium chlorate	13453-30-0	Contains (regardless of intentional or impurities)	chemical products
8116	Thallium chloride (TlCl <sub>3</sub> )	13453-32-2	Contains (regardless of intentional or impurities)	chemical products
8117	Thallium cyanide	13453-34-4	Intentional addition / 1,000ppm	chemical products
8118	Dithallium dichromate	13453-35-5	Contains (regardless of intentional or impurities)	chemical products
8119	Thallium triiodide	13453-37-7	Contains (regardless of intentional or impurities)	chemical products
8120	Nitric acid, thallium(3+) salt, trihydrate	13453-38-8	Contains (regardless of intentional or impurities)	chemical products
8121	Boric acid (HBO <sub>2</sub> ), lithium salt	13453-69-5	Intentional addition / 1%	chemical products
8122	Lithium chlorate	13453-71-9	Intentional addition / 1%	chemical products
8123	Lithium perchlorate trihydrate	13453-78-6	Intentional addition / 1,000ppm	chemical products
8124	Lithium permanganate	13453-79-7	Contains (regardless of intentional or impurities)	chemical products
8125	Cerium molybdenum oxide (Ce <sub>2</sub> Mo <sub>3</sub> O <sub>12</sub> )	13454-70-1	Contains (regardless of intentional or impurities)	chemical products
8126	Cesium chromate	13454-78-9	Contains (regardless of intentional or impurities)	chemical products
8127	Nitrous acid, cesium salt	13454-83-6	Intentional addition / 1,000ppm	chemical products
8128	Perchloric acid, cesium salt	13454-84-7	Intentional addition / 1,000ppm	chemical products
8129	Copper(II) fluoride dihydrate	13454-88-1	Intentional addition / 1,000ppm	chemical products
8130	Platinum chloride (PtCl <sub>4</sub> ), (SP-4-1)-	13454-96-1	Contains (regardless of intentional or impurities)	chemical products
8131	Hypodiphosphorous tetraiodide	13455-00-0	Intentional addition / 1,000ppm	chemical products
8132	Platinum bromide (PtBr <sub>2</sub> )	13455-12-4	Contains (regardless of intentional or impurities)	chemical products
8133	Potassium fluoride (KF), dihydrate	13455-21-5	Contains (regardless of intentional or impurities)	chemical products
8134	Cobalt chromate	13455-25-9	Contains (regardless of intentional or impurities)	chemical products
8135	Cobalt difluoride dihydrate	13455-27-1	Intentional addition / 1%	chemical products
8136	Cobalt diiodate	13455-28-2	Intentional addition / 1%	chemical products
8137	Perchloric acid, cobalt(2+) salt	13455-31-7	Intentional addition / 1,000ppm	chemical products
8138	Dicobalt orthosilicate	13455-33-9	Intentional addition / 1,000ppm	chemical products
8139	Cobalt sulfate monohydrate	13455-34-0	Intentional addition / 1%	chemical products
8140	Cobalt(II) phosphate	13455-36-2	Intentional addition / 1,000ppm	chemical products
8141	Permanganic acid (HMnO <sub>4</sub> ), cesium salt	13456-28-5	Contains (regardless of intentional or impurities)	chemical products
8142	Pyrazophos	13457-18-6	Contains (regardless of intentional or impurities)	chemical products
8143	Boric acid (HBO <sub>2</sub> )	13460-50-9	Intentional addition / 1%	chemical products
8144	Boric acid (H <sub>3</sub> BO <sub>3</sub> )	13460-51-0	Intentional addition / 1%	chemical products
8145	Barite (BaSO <sub>4</sub> )	13462-86-7	Intentional addition	chemical products
8146	Nickel bromide (NiBr <sub>2</sub> )	13462-88-9	Contains (regardless of intentional or impurities)	chemical products
8147	Nickel iodide (NiI <sub>2</sub> )	13462-90-3	Contains (regardless of intentional or impurities)	chemical products
8148	Arsenic acid (H <sub>3</sub> AsO <sub>4</sub> ), aluminum salt (1:1)	13462-91-4	Contains (regardless of intentional or impurities)	chemical products
8149	Arsenic acid (H <sub>3</sub> AsO <sub>4</sub> ), monoammonium salt	13462-93-6	Contains (regardless of intentional or impurities)	chemical products
8150	Ammonium arsenite	13462-94-7	Contains (regardless of intentional or impurities)	chemical products
8151	Lead tetrachloride	13463-30-4	Contains (regardless of intentional or impurities)	chemical products
8152	Nickel carbonyl	13463-39-3	Contains (regardless of intentional or impurities)	chemical products
8153	Iron, pentacarbonyl-	13463-40-6	Contains (regardless of intentional or impurities)	chemical products
8154	Zinc pyrrhione	13463-41-7	Intentional addition / 100ppm	chemical products
8155	Chromate(3-), bis[3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, trihydrogen	13463-42-8	Contains (regardless of intentional or impurities)	chemical products
8156	Sulfuric acid, iron(2+) salt (1:1), hydrate	13463-43-9	Intentional addition / 1%	chemical products
8157	Titanium dioxide	13463-67-7	Contains (regardless of intentional or impurities)	chemical products
8158	Potassium arsenite	13464-35-2	Contains (regardless of intentional or impurities)	chemical products
8159	Tripotassium arsenate	13464-36-3	Intentional addition / 1,000ppm	chemical products
8160	Arsenous acid, trisodium salt	13464-37-4	Contains (regardless of intentional or impurities)	chemical products
8161	Arsenic acid (H <sub>3</sub> AsO <sub>4</sub> ), trisodium salt	13464-38-5	Contains (regardless of intentional or impurities)	chemical products
8162	Diarsenic acid, calcium salt (1:2)	13464-39-6	Contains (regardless of intentional or impurities)	chemical products
8163	Sodium pyroarsenate	13464-42-1	Contains (regardless of intentional or impurities)	chemical products
8164	Zinc arsenate	13464-44-3	Contains (regardless of intentional or impurities)	chemical products
8165	Arsenous acid	13464-58-9	Contains (regardless of intentional or impurities)	chemical products
8166	Arsenic acid (H <sub>3</sub> AsO <sub>4</sub> ), strontium salt (2:3)	13464-68-1	Contains (regardless of intentional or impurities)	chemical products
8167	Gold trinitrate	13464-77-2	Intentional addition	chemical products
8168	Hydrazine, sulfate (2:1)	13464-80-7	Contains (regardless of intentional or impurities)	chemical products
8169	Sulfuric acid, indium(3+) salt (3:2)	13464-82-9	Intentional addition / 1%	chemical products
8170	Cadmium bromide, tetrahydrate	13464-92-1	Contains (regardless of intentional or impurities)	chemical products
8171	Hydrazine, mononitrate	13464-97-6	Contains (regardless of intentional or impurities)	chemical products
8172	Hydrazine, dinitrate	13464-98-7	Contains (regardless of intentional or impurities)	chemical products
8173	Hydrogen sulfide (H <sub>2</sub> S <sub>2</sub> )	13465-07-1	Intentional addition / 1%	chemical products
8174	Hydroxylamine, nitrate (salt)	13465-08-2	Contains (regardless of intentional or impurities)	chemical products
8175	Indium bromide (InBr <sub>3</sub> )	13465-09-3	Intentional addition / 1%	chemical products
8176	Indium chloride (InCl <sub>3</sub> )	13465-10-6	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
8177	Nitric acid, indium(3+) salt, hydrate (2:9)	13465-14-0	Intentional addition / 1,000ppm	chemical products
8178	Sulfuric acid, manganese(2+) salt (1:1), pentahydrate	13465-27-5	Contains (regardless of intentional or impurities)	chemical products
8179	Permanganic acid	13465-41-3	Contains (regardless of intentional or impurities)	chemical products
8180	Rhodium(III) nitrate, dihydrate	13465-43-5	Intentional addition / 1%	chemical products
8181	Rubidium permanganate (RbMnO4)	13465-49-1	Contains (regardless of intentional or impurities)	chemical products
8182	Selenic acid monohydrate	13465-62-8	Intentional addition / 1,000ppm	chemical products
8183	Selenium tetrafluoride	13465-66-2	Contains (regardless of intentional or impurities)	chemical products
8184	Silver metaborate	13465-88-8	Intentional addition / 1%	chemical products
8185	Disilver tungsten tetraoxide	13465-93-5	Intentional addition	chemical products
8186	Nitrous acid, barium salt	13465-94-6	Contains (regardless of intentional or impurities)	chemical products
8187	Barium perchlorate	13465-95-7	Contains (regardless of intentional or impurities)	chemical products
8188	Silver metaphosphate	13465-96-8	Intentional addition / 25%	chemical products
8189	Diphosphoric acid, tetrasilver(1+) salt	13465-97-9	Intentional addition / 25%	chemical products
8190	Sulfurous acid, disilver(1+) salt	13465-98-0	Intentional addition / 1%	chemical products
8191	Molybdenum sodium oxide (Mo2Na2O7)	13468-16-5	Intentional addition / 1%	chemical products
8192	Barium peroxodisulfate tetrahydrate	13468-19-8	Intentional addition / 1%	chemical products
8193	Phosphoric acid, barium salt (2:1)	13468-20-1	Intentional addition / 1,000ppm	chemical products
8194	Diphosphoric acid, barium salt (1:2)	13468-21-2	Intentional addition / 1,000ppm	chemical products
8195	Telluric acid (H2TeO4), barium salt (1:1)	13468-24-5	Contains (regardless of intentional or impurities)	chemical products
8196	Beryllium chloride, tetrahydrate	13468-27-8	Contains (regardless of intentional or impurities)	chemical products
8197	Nonanoic acid, (dibutylstannylene)bis(thioethylene) ester	13467-96-4	Contains (regardless of intentional or impurities)	chemical products
8198	1,4-Dioxo-7,9-dithia-8-stannocycloundecane-5,11-dione, 8,8-dibutyl-	13468-00-3	Contains (regardless of intentional or impurities)	chemical products
8199	Copper(II) chloride dihydrate	13468-85-4	Intentional addition / 1,000ppm	chemical products
8200	Yttrium bromide (YBr3)	13469-98-2	Intentional addition / 1%	chemical products
8201	Molybdate (MoO42-), strontium (1:1), (T-4)-	13470-04-7	Contains (regardless of intentional or impurities)	chemical products
8202	Nitrous acid, strontium salt	13470-06-9	Intentional addition / 1,000ppm	chemical products
8203	Uranium bromide (UBr4)	13470-20-7	Contains (regardless of intentional or impurities)	chemical products
8204	Uranium iodide (UI4)	13470-22-9	Contains (regardless of intentional or impurities)	chemical products
8205	Vanadium bromide (VBr3)	13470-26-3	Intentional addition / 1%	chemical products
8206	Yttrium iodide (YI3)	13470-38-7	Intentional addition / 1%	chemical products
8207	Nitric acid, yttrium(3+) salt, trihydrate	13470-40-1	Intentional addition / 1%	chemical products
8208	Butanenitrile, 2,2'-azobis[2-methyl-	13472-08-7	Contains (regardless of intentional or impurities)	chemical products
8209	Tungstate (WO42-), disodium (T-4)-	13472-45-2	Intentional addition / 1%	chemical products
8210	Metastannic acid	13472-47-4	Contains (regardless of intentional or impurities)	chemical products
8211	Thallium(I) chromate	13473-75-1	Contains (regardless of intentional or impurities)	chemical products
8212	Aluminum nitrate	13473-90-0	Intentional addition / 1,000ppm	chemical products
8213	1,1-Dichloro-1,2,2,3,3-pentafluoropropane	13474-88-9	Intentional addition / 1,000ppm	chemical products
8214	Phosphoric acid, chromium(3+) salt (1:1), hexahydrate	13475-98-4	Contains (regardless of intentional or impurities)	chemical products
8215	Nitric acid, iron(3+) salt, hexahydrate	13476-08-9	Intentional addition / 1,000ppm	chemical products
8216	Copper dihexanoate	13476-79-4	Intentional addition / 1,000ppm	chemical products
8217	Vanadium, tris(2,4-pentanedionato-O,O')-, (OC-6-11)-	13476-99-8	Intentional addition / 1%	chemical products
8218	Barium chlorate	13477-00-4	Contains (regardless of intentional or impurities)	chemical products
8219	Barium dichromate	13477-01-5	Contains (regardless of intentional or impurities)	chemical products
8220	Arsenic acid (H3AsO4), barium salt (2:3)	13477-04-8	Contains (regardless of intentional or impurities)	chemical products
8221	Barium hydride (BaH2)	13477-09-3	Contains (regardless of intentional or impurities)	chemical products
8222	Barium hypochlorite	13477-10-6	Contains (regardless of intentional or impurities)	chemical products
8223	Barium iodide hexahydrate	13477-15-1	Intentional addition	chemical products
8224	Phosphoric acid, cadmium salt (2:3)	13477-17-3	Contains (regardless of intentional or impurities)	chemical products
8225	Silicic acid (H2SiO3), cadmium salt (1:1)	13477-19-5	Contains (regardless of intentional or impurities)	chemical products
8226	Cadmium sulphate tetrahydrate	13477-21-9	Contains (regardless of intentional or impurities)	chemical products
8227	Cadmium sulphite	13477-23-1	Contains (regardless of intentional or impurities)	chemical products
8228	Calcium perchlorate	13477-36-6	Contains (regardless of intentional or impurities)	chemical products
8229	Trinickel bis(arsenate)	13477-70-8	Contains (regardless of intentional or impurities)	chemical products
8230	Nickel dichlorate hexahydrate	13477-93-5	Intentional addition / 1,000ppm	chemical products
8231	Nickel dichlorate hexahydrate	13477-94-6	Intentional addition / 1,000ppm	chemical products
8232	Phosphoric acid, nickel(2+) salt, hexahydrate	13477-97-9	Contains (regardless of intentional or impurities)	chemical products
8233	Nickel(II) nitrate, hexahydrate (1:2:6)	13478-00-7	Contains (regardless of intentional or impurities)	chemical products
8234	Chromium(III) bromide hexahydrate	13478-06-3	Intentional addition / 1,000ppm	chemical products
8235	Dicobalt tris(sulphate)	13478-09-6	Intentional addition / 1,000ppm	chemical products
8236	Iron chloride (FeCl2), tetrahydrate	13478-10-9	Intentional addition / 1%	chemical products
8237	Arsenic acid (H3AsO4), trithium salt	13478-14-3	Contains (regardless of intentional or impurities)	chemical products
8238	Molybdenum chloride (MoCl2)	13478-17-6	Contains (regardless of intentional or impurities)	chemical products
8239	Molybdenum chloride (MoCl3)	13478-18-7	Contains (regardless of intentional or impurities)	chemical products
8240	Chromium diiodide	13478-28-9	Intentional addition / 1,000ppm	chemical products
8241	Cobalt(III) perchlorate hexahydrate	13478-33-6	Intentional addition / 1,000ppm	chemical products
8242	Arsenic acid, copper(2+) salt (2:3), tetrahydrate	13478-34-7	Contains (regardless of intentional or impurities)	chemical products
8243	Copper fluoride (CuF)	13478-41-6	Intentional addition / 1,000ppm	chemical products
8244	1-Naphthalenesulfonic acid, 3-[[4'-[(2,4-diamino-5-methylphenyl)azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-4,6-dihydroxy-, monosodium salt	13478-92-7	Intentional addition / 100ppm	chemical products
8245	Bis(butanedione dioximato)nickel	13478-93-8	Contains (regardless of intentional or impurities)	chemical products
8246	Bis(glycinato)copper	13479-54-4	Intentional addition / 1,000ppm	chemical products
8247	2,3-Dicyanopyrazine	13481-25-9	Intentional addition	chemical products
8248	Tellurium	13494-80-9	Contains (regardless of intentional or impurities)	chemical products
8249	Cobalt(III) sulfate	13494-89-8	Intentional addition / 1%	chemical products
8250	Nitric acid, yttrium(3+) salt, hexahydrate	13494-98-9	Contains (regardless of intentional or impurities)	chemical products
8251	Butanedioic acid, 2,2'-[(dibutylstannylene)bis(thio)]bis-, tetrabutyl ester	13497-25-1	Contains (regardless of intentional or impurities)	chemical products
8252	Silver vanadium oxide (AgVO3)	13497-94-4	Intentional addition / 1%	chemical products
8253	Neodymium(3+) perchlorate	13498-06-1	Intentional addition / 1,000ppm	chemical products
8254	Praseodymium(3+) perchlorate	13498-07-2	Intentional addition / 1,000ppm	chemical products
8255	Ytterbium(3+) perchlorate	13498-08-3	Intentional addition / 1,000ppm	chemical products
8256	Hafnium chloride (HfCl4), (T-4)-	13499-05-3	Intentional addition / 1%	chemical products
8257	Boron arsenate	13510-31-1	Contains (regardless of intentional or impurities)	chemical products
8258	Indium iodide (InI3)	13510-35-5	Intentional addition / 1%	chemical products
8259	Perchloric acid, rubidium salt	13510-42-4	Intentional addition / 1,000ppm	chemical products
8260	Arsenic acid (H3AsO4), trisilver(1+) salt	13510-44-6	Contains (regardless of intentional or impurities)	chemical products
8261	Arsenic acid (H3AsO4), trisodium salt, dodecahydrate	13510-46-8	Contains (regardless of intentional or impurities)	chemical products
8262	Nitric acid, beryllium salt, tetrahydrate	13510-48-0	Contains (regardless of intentional or impurities)	chemical products
8263	Beryllium sulfate	13510-49-1	Contains (regardless of intentional or impurities)	chemical products
8264	Sulfuric acid, yttrium(3+) salt (3:2)	13510-71-9	Intentional addition / 1%	chemical products
8265	Zinc arsenate octahydrate	13510-72-0	Intentional addition / 1,000ppm	chemical products
8266	Disodium uranium tetraoxide	13510-99-1	Contains (regardless of intentional or impurities)	chemical products
8267	1,1'-Iminodis(octamethylene)diguanidine	13516-27-3	Intentional addition / 1%	chemical products
8268	Phosphoric acid, barium salt (2:3)	13517-08-3	Intentional addition / 1,000ppm	chemical products
8269	Borane, triiodo-	13517-10-7	Intentional addition / 1%	chemical products
8270	Sodium chromate decahydrate	13517-17-4	Contains (regardless of intentional or impurities)	chemical products
8271	Vanadate (V2O74-), tetrasodium	13517-26-5	Intentional addition / 1%	chemical products
8272	Zinc bromate hexahydrate	13517-27-6	Intentional addition / 1%	chemical products
8273	Telluric acid (H2TeO4)	13520-55-3	Contains (regardless of intentional or impurities)	chemical products
8274	Molybdenum tetrabromide	13520-59-7	Intentional addition / 1%	chemical products
8275	Perchloric acid, nickel(2+) salt, hexahydrate	13520-61-1	Contains (regardless of intentional or impurities)	chemical products
8276	Sulfuric acid, chromium(3+) salt (3:2), octadecahydrate	13520-66-6	Intentional addition / 1,000ppm	chemical products
8277	Tungsten dichloride dioxide	13520-76-8	Intentional addition / 1%	chemical products
8278	Tungsten tetrachloride oxide	13520-78-0	Intentional addition / 1%	chemical products
8279	Uranyl nitrate hexahydrate	13520-83-7	Contains (regardless of intentional or impurities)	chemical products
8280	Zirconium, dichlorooxo-, octahydrate	13520-92-8	Contains (regardless of intentional or impurities)	chemical products
8281	Indium(3+) perchlorate	13529-74-3	Intentional addition / 1,000ppm	chemical products
8282	Phosphoric acid, aluminum salt (3:1)	13530-50-2	Intentional addition / 1,000ppm	chemical products
8283	Zinc chromate	13530-65-9	Contains (regardless of intentional or impurities)	chemical products
8284	Caesium dichromate	13530-67-1	Contains (regardless of intentional or impurities)	chemical products
8285	Boron, trifluoro(tetrahydrofuran)-, (T-4)-	13533-00-1	Intentional addition / 1%	chemical products
8286	Uranium, difluorodioxo-, (T-4)-	13536-84-0	Contains (regardless of intentional or impurities)	chemical products
8287	Europium vanadium tetraoxide	13537-11-6	Intentional addition / 1%	chemical products
8288	Perchloric acid, chromium(3+) salt	13537-21-8	Contains (regardless of intentional or impurities)	chemical products
8289	Europium(3+) perchlorate	13537-22-9	Intentional addition / 1,000ppm	chemical products
8290	Perchloric acid, iron(3+) salt	13537-24-1	Intentional addition / 1,000ppm	chemical products
8291	Monofluorophosphoric acid	13537-32-1	Contains (regardless of intentional or impurities)	chemical products
8292	Hydrazine, dihydrofluoride	13537-45-6	Contains (regardless of intentional or impurities)	chemical products
8293	Chromium(III) nitrate	13548-38-4	Contains (regardless of intentional or impurities)	chemical products
8294	Copper chromate	13548-42-0	Contains (regardless of intentional or impurities)	chemical products
8295	Ammonium chromium bis(sulphate)	13548-43-1	Contains (regardless of intentional or impurities)	chemical products
8296	Bromic acid, lithium salt	13550-28-2	Intentional addition / 1%	chemical products
8297	Dysprosium vanadium tetraoxide	13550-50-0	Intentional addition / 1%	chemical products
8298	Oxirane, 2,2'-(oxiranymethoxy)-1,3-phenylenebis(methylene)bis-	13561-08-5	Intentional addition / 1%	chemical products
8299	Bismuth molybdenum oxide (Bi2MoO6)	13565-96-3	Contains (regardless of intentional or impurities)	chemical products
8300	Zirconium diphosphate	13565-97-4	Contains (regardless of intentional or impurities)	chemical products
8301	Praseodymium vanadium tetraoxide	13566-04-6	Intentional addition / 1%	chemical products
8302	Vanadate (VO43-), trirubidium, (T-4)-	13566-05-7	Intentional addition / 1%	chemical products
8303	Scandium vanadium tetraoxide	13566-07-9	Intentional addition / 1%	chemical products
8304	Samarium vanadium tetraoxide	13566-08-0	Intentional addition / 1%	chemical products
8305	Terbium vanadium tetraoxide	13566-09-1	Intentional addition / 1%	chemical products
8306	Thulium orthovanadate	13566-11-5	Intentional addition / 1%	chemical products
8307	Vanadium yttrium oxide (VYO4)	13566-12-6	Intentional addition / 1%	chemical products
8308	Vanadium yttrium tetraoxide	13566-13-7	Intentional addition / 1%	chemical products
8309	Metaphosphoric acid (HPO3), zinc salt	13566-15-9	Intentional addition / 25%	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
8310	Diammonium manganese bis(sulphate)	13566-22-8	Contains (regardless of intentional or impurities)	chemical products
8311	Manganese(2+) silicate	13568-32-6	Contains (regardless of intentional or impurities)	chemical products
8312	Nitrous acid, lithium salt	13568-33-7	Contains (regardless of intentional or impurities)	chemical products
8313	Molybdate (MoO4 <sup>2-</sup> ), dilithium, (T-4)-	13568-40-6	Contains (regardless of intentional or impurities)	chemical products
8314	Lutetium vanadium tetroxide	13568-56-4	Intentional addition / 1%	chemical products
8315	Lutetium trivanadium nonaoxide	13568-57-5	Intentional addition / 1%	chemical products
8316	Magnesium duranium heptaoxide	13568-61-1	Contains (regardless of intentional or impurities)	chemical products
8317	Manganese(II) sulfite	13568-71-3	Contains (regardless of intentional or impurities)	chemical products
8318	Samarium(3+) perchlorate	13569-80-3	Intentional addition / 1,000ppm	chemical products
8319	Rhodium chloride (RhCl3), trihydrate	13569-85-8	Intentional addition / 1%	chemical products
8320	Chromium iodide (CrI3)	13569-75-0	Contains (regardless of intentional or impurities)	chemical products
8321	Tetrasodium [mu-[[3,3'-(3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl)bis(azo)]bis(4,5-dihydroxynaphthalene-2,7-disulphonato)](8-)]dicarboxylate(4-)	13569-92-1	Intentional addition / 1,000ppm	chemical products
8322	Vanadate (VO3 <sup>-</sup> ), magnesium (2:1)	13573-13-2	Intentional addition / 1%	chemical products
8323	Chromate(1-), diamminetetraakis(thiocyanato-N-), ammonium, (OC-6-11)-	13573-16-5	Contains (regardless of intentional or impurities)	chemical products
8324	Reinecke salt, monohydrate	13573-17-6	Contains (regardless of intentional or impurities)	chemical products
8325	Sulfuric acid, ammonium cobalt(2+) salt (2:2:1), hexahydrate	13586-38-4	Intentional addition / 100ppm	chemical products
8326	Hexanoic acid, 2-ethyl-, cobalt salt	13586-82-8	Intentional addition / 100ppm	chemical products
8327	Octadecanoic acid, cobalt salt	13586-84-0	Intentional addition / 1,000ppm	chemical products
8328	Copper hydrogen phosphate	13587-24-1	Intentional addition / 1,000ppm	chemical products
8329	Diammonium copper(2+) disulphate	13587-25-2	Intentional addition / 1,000ppm	chemical products
8330	Sulfuric acid, ammonium copper(2+) salt (2:2:1), hexahydrate	13587-26-3	Intentional addition / 1,000ppm	chemical products
8331	Sulfuric acid, copper(2+) potassium salt (2:1:2), hexahydrate	13587-29-6	Intentional addition / 1,000ppm	chemical products
8332	Copper tungsten oxide (CuWO4)	13587-35-4	Intentional addition / 1,000ppm	chemical products
8333	Guanidine, dodecyl-, monohydrochloride	13590-97-1	Intentional addition / 1,000ppm	chemical products
8334	Quinalphos	13593-03-8	Contains (regardless of intentional or impurities)	chemical products
8335	Bismuth molybdenum oxide (Bi2Mo3O12)	13595-85-2	Contains (regardless of intentional or impurities)	chemical products
8336	Erbium tetraoxide vanadium	13596-17-3	Intentional addition / 1%	chemical products
8337	Phosphoric acid, cobalt(2+) salt (1:1)	13596-21-9	Intentional addition / 1,000ppm	chemical products
8338	Dipotassium disulphatocobaltate	13596-22-0	Intentional addition / 1,000ppm	chemical products
8339	Cobalt fluoride (CoF4), (T-4)-	13596-45-7	Intentional addition / 1%	chemical products
8340	Sulfuric acid, ammonium cobalt(2+) salt (2:2:1)	13596-46-8	Intentional addition / 1,000ppm	chemical products
8341	Cerium vanadium oxide (CeVO4)	13597-19-8	Intentional addition / 1%	chemical products
8342	Sulfurous acid, zinc salt (1:1)	13597-44-9	Intentional addition / 25%	chemical products
8343	Vanadate (VO3 <sup>-</sup> ), rubidium	13597-45-0	Intentional addition / 1%	chemical products
8344	Zinc selenite	13597-46-1	Contains (regardless of intentional or impurities)	chemical products
8345	Zinc selenate	13597-54-1	Contains (regardless of intentional or impurities)	chemical products
8346	Tungsten zinc oxide (WZnO4)	13597-56-3	Intentional addition	chemical products
8347	Strontium vanadium oxide (SrV2O6)	13597-58-5	Intentional addition / 1%	chemical products
8348	Vanadate (V2O7 <sup>4-</sup> ), tetrarubidium	13597-61-0	Intentional addition / 1%	chemical products
8349	Molybdate (MoO4 <sup>2-</sup> ), cesium, (T-4)-	13597-64-3	Contains (regardless of intentional or impurities)	chemical products
8350	Silicic acid (H4SiO4), zinc salt (1:2)	13597-65-4	Intentional addition / 25%	chemical products
8351	Beryllium diperchlorate	13597-95-0	Intentional addition / 1,000ppm	chemical products
8352	Beryllium fluoride (BeF)	13597-96-1	Contains (regardless of intentional or impurities)	chemical products
8353	Beryllium nitrate	13597-99-4	Contains (regardless of intentional or impurities)	chemical products
8354	Beryllium silicate	13598-00-0	Contains (regardless of intentional or impurities)	chemical products
8355	Tribarium divanadium octaoxide	13598-03-3	Contains (regardless of intentional or impurities)	chemical products
8356	Beryllium phosphate	13598-15-7	Contains (regardless of intentional or impurities)	chemical products
8357	Beryllium sulfide (BeS)	13598-22-6	Contains (regardless of intentional or impurities)	chemical products
8358	Phosphoric acid, beryllium salt (2:3)	13598-26-0	Contains (regardless of intentional or impurities)	chemical products
8359	Phosphoric acid [H(P=O)(OH)2]	13598-36-2	Contains (regardless of intentional or impurities)	chemical products
8360	Phosphoric acid, zinc salt (2:1)	13598-37-3	Intentional addition / 1%	chemical products
8361	Uranium hydride (UH3)	13598-56-6	Contains (regardless of intentional or impurities)	chemical products
8362	Yttrium trioxide (Y2O3)	13598-57-7	Intentional addition / 1%	chemical products
8363	Trisodium hexanitritocobaltate	13600-98-1	Intentional addition / 1,000ppm	chemical products
8364	Chromate(2-), hexakis(cyano-C-), tripotassium, (OC-6-11)-	13601-11-1	Contains (regardless of intentional or impurities)	chemical products
8365	Dicopper hexacyanoferrate	13601-13-3	Contains (regardless of intentional or impurities)	chemical products
8366	Ferrate(4-), hexakis(cyano-C-), tetrasodium, (OC-6-11)-	13601-19-9	Contains (regardless of intentional or impurities)	chemical products
8367	(OC-6-22)-Pentaamminebromocobalt dichloride	13601-38-2	Intentional addition / 1%	chemical products
8368	Hexaaminenickel(II) bromide	13601-55-3	Contains (regardless of intentional or impurities)	chemical products
8369	[N-(Carboxymethyl)-N-(2-hydroxyethyl)glycinate]copper	13601-75-7	Intentional addition / 1,000ppm	chemical products
8370	2,4,6-Cycloheptatriene-1-carbonitrile	13612-59-4	Intentional addition	chemical products
8371	Cyano-N-methylthioformamide	13621-47-1	Intentional addition	chemical products
8372	Cyclohexane, 1,1'-methylenebis[4-isocyanato-, [trans/trans]-]	13622-90-7	Intentional addition / 1,000ppm	chemical products
8373	Nicotine, mono(dimethylthiocarbamate)	13624-74-3	Contains (regardless of intentional or impurities)	chemical products
8374	Nicotine, mono(methylthiocarbamate)	13624-75-4	Contains (regardless of intentional or impurities)	chemical products
8375	Nicotine, mono(tetrathio-p-benzenedicarbamate)	13624-76-5	Contains (regardless of intentional or impurities)	chemical products
8376	Nicotine, mono(dithiocarbamate)	13624-77-6	Contains (regardless of intentional or impurities)	chemical products
8377	Nicotine, 1,4-piperazinedicarbodithioate (1:1)	13624-78-7	Contains (regardless of intentional or impurities)	chemical products
8378	Nicotine, mono(dithiocarbamate)	13624-79-8	Contains (regardless of intentional or impurities)	chemical products
8379	Gadolinium orthovanadate	13628-52-9	Intentional addition / 1%	chemical products
8380	Gadolinium trivanadium nonaoxide	13628-53-0	Intentional addition / 1%	chemical products
8381	Perchloric acid, zinc salt	13637-61-1	Intentional addition / 1,000ppm	chemical products
8382	Molybdenum(VI) dichloride dioxide	13637-68-8	Intentional addition / 1%	chemical products
8383	Nickel perchlorate	13637-71-3	Contains (regardless of intentional or impurities)	chemical products
8384	m-Phenylenediamine hydrochloride	13652-74-9	Intentional addition / 25%	chemical products
8385	Nickel(2+) palmitate	13654-40-5	Contains (regardless of intentional or impurities)	chemical products
8386	Borate(3-), trifluorophosphato(3--O)-, trihydrogen, (T-4)-	13669-76-6	Intentional addition / 1,000ppm	chemical products
8387	2-Propanol, 1-chloro-, phosphate (3:1)	13674-84-5	Intentional addition / 900ppm	chemical products
8388	2-Propanol, 1,3-dichloro-, phosphate (3:1)	13674-87-8	Contains (regardless of intentional or impurities)	chemical products
8389	Copper dichromate	13675-47-3	Contains (regardless of intentional or impurities)	chemical products
8390	2-(4-Aminophenyl) benzoxazole-5-ylamine	13676-47-6	Contains (regardless of intentional or impurities)	chemical products
8391	Aurate(1-), tetrachloro-, potassium, (SP-4-1)-	13682-61-6	Intentional addition	chemical products
8392	Potassium cuprocyanide	13682-73-0	Contains (regardless of intentional or impurities)	chemical products
8393	Phenmedipham	13684-63-4	Contains (regardless of intentional or impurities)	chemical products
8394	Nickel dithiocyanate	13689-92-4	Contains (regardless of intentional or impurities)	chemical products
8395	Praseodymium trivanadium nonaoxide	13692-90-5	Intentional addition / 1%	chemical products
8396	Samarium trivanadium nonaoxide	13692-91-6	Intentional addition / 1%	chemical products
8397	Vanadium yttrium oxide (V3YO9)	13692-92-7	Intentional addition / 1%	chemical products
8398	Platinum hexafluoride	13693-05-5	Contains (regardless of intentional or impurities)	chemical products
8399	Barium metaborate	13701-59-2	Contains (regardless of intentional or impurities)	chemical products
8400	Boric acid (H4B2O5), calcium salt (1:2)	13701-60-5	Intentional addition / 1%	chemical products
8401	Boric acid (H3BO3), calcium salt (2:3)	13701-61-6	Intentional addition / 1%	chemical products
8402	Boric acid (HBO2), calcium salt	13701-64-9	Intentional addition / 1%	chemical products
8403	Diboron tricadmium hexaoxide	13701-66-1	Contains (regardless of intentional or impurities)	chemical products
8404	Boric acid (H3BO3), cobalt(2+) salt (2:3)	13701-68-3	Intentional addition / 1%	chemical products
8405	Sulfuric acid, vanadium(3+) salt (3:2)	13701-70-7	Intentional addition / 1%	chemical products
8406	Silicic acid (H4SiO4), yttrium(3+) salt (3:4)	13701-72-9	Intentional addition / 1%	chemical products
8407	Thallium bromide (TlBr3)	13701-90-1	Contains (regardless of intentional or impurities)	chemical products
8408	Arsenic acid (H3AsO4), bismuth salt (1:1)	13702-38-0	Contains (regardless of intentional or impurities)	chemical products
8409	Magnesium metaborate	13703-82-7	Intentional addition / 1%	chemical products
8410	Strontium metaborate	13703-84-9	Intentional addition / 1%	chemical products
8411	Boric acid (H4B2O5), strontium salt (1:2)	13703-86-1	Intentional addition / 1%	chemical products
8412	Triboron gadolinium(3+) hexaoxide	13703-96-3	Intentional addition / 1%	chemical products
8413	Triboron lanthanum(3+) hexaoxide	13703-99-6	Intentional addition / 1%	chemical products
8414	[1,1'-Biphenyl]-2-ol, potassium salt	13707-85-8	Intentional addition / 1,000ppm	chemical products
8415	Silicic acid (H4SiO4), barium zirconium(4+) salt (3:2)	13708-67-3	Contains (regardless of intentional or impurities)	chemical products
8416	Trifluoroxyvanadium	13709-31-4	Intentional addition / 1%	chemical products
8417	Yttrium fluoride (YF3)	13709-49-4	Contains (regardless of intentional or impurities)	chemical products
8418	Hafnium tetrafluoride	13709-52-9	Contains (regardless of intentional or impurities)	chemical products
8419	Rubidium metaborate	13709-66-5	Intentional addition / 1%	chemical products
8420	Aminetrifluoroboron	13709-86-9	Intentional addition / 1%	chemical products
8421	Boric acid (H3BO3), indium(3+) salt (1:1)	13709-93-8	Intentional addition / 1%	chemical products
8422	Boric acid (HBO2), potassium salt	13709-94-9	Intentional addition / 1%	chemical products
8423	Boron lanthanum(3+) trioxide	13709-95-0	Intentional addition / 1%	chemical products
8424	Cuprate(1-), bis(cyano-C-), sodium	13715-19-0	Contains (regardless of intentional or impurities)	chemical products
8425	Molybdate (MoO4 <sup>2-</sup> ), dirubidium, (T-4)-	13718-22-4	Contains (regardless of intentional or impurities)	chemical products
8426	Vanadate (VO3 <sup>-</sup> ), sodium	13718-26-8	Intentional addition / 1%	chemical products
8427	Manganese dipotassium bis(sulphate)	13718-34-8	Contains (regardless of intentional or impurities)	chemical products
8428	Barium iodide (BaI2)	13718-50-8	Contains (regardless of intentional or impurities)	chemical products
8429	Barium chloride fluoride (BaClF)	13718-55-3	Contains (regardless of intentional or impurities)	chemical products
8430	Barium periodate	13718-58-6	Contains (regardless of intentional or impurities)	chemical products
8431	Selenious acid, barium salt (1:1)	13718-59-7	Contains (regardless of intentional or impurities)	chemical products
8432	Iron potassium bis(sulphate)	13718-65-5	Intentional addition / 1%	chemical products
8433	Ferrate (FeO4 <sup>2-</sup> ), dipotassium, (T-4)-	13718-66-6	Intentional addition / 1%	chemical products
8434	Iron molybdenum oxide (FeMoO4)	13718-70-2	Intentional addition / 1%	chemical products
8435	Disodium uranate	13721-34-1	Contains (regardless of intentional or impurities)	chemical products
8436	Sodium vanadium oxide (Na3VO4)	13721-39-6	Intentional addition / 1%	chemical products
8437	Neodymium orthovanadate	13721-46-5	Intentional addition / 1%	chemical products
8438	Neodymium trivanadium nonaoxide	13721-47-6	Intentional addition / 1%	chemical products
8439	2,5-Dimethylbenzotrile	13730-09-1	Intentional addition	chemical products
8440	Potassium ferricyanide	13746-66-2	Contains (regardless of intentional or impurities)	chemical products
8441	Nitric acid, zirconium(4+) salt	13746-89-9	Contains (regardless of intentional or impurities)	chemical products
8442	Nitric acid, thallium(3+) salt	13746-98-0	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
8443	1,2-Dibromo-1,1,2-trichloroethane	13749-38-7	Intentional addition / 1,000ppm	chemical products
8444	Borate(1-), tetrafluoro-, sodium	13755-29-8	Contains (regardless of intentional or impurities)	chemical products
8445	Dicadmium hexakis(cyano-C) ferrate(4-)	13755-33-4	Contains (regardless of intentional or impurities)	chemical products
8446	Ferrate(2-), pentakis(cyano-C)nitrosyl-, disodium, dihydrate, (OC-6-22)-	13755-38-9	Contains (regardless of intentional or impurities)	chemical products
8447	Hafnium chloride oxide (HfCl2O)	13759-17-6	Intentional addition / 1%	chemical products
8448	Cadmium perchlorate	13760-37-7	Contains (regardless of intentional or impurities)	chemical products
8449	Cobalt molybdenum oxide (CoMoO4)	13762-14-6	Contains (regardless of intentional or impurities)	chemical products
8450	Cobalt difluoride trihydrate	13762-15-7	Intentional addition / 1%	chemical products
8451	Borate(1-), tetrahydro-, potassium	13762-51-1	Contains (regardless of intentional or impurities)	chemical products
8452	Hydrazine perchlorate (1:1)	13762-80-6	Contains (regardless of intentional or impurities)	chemical products
8453	Barium dimetaphosphate	13762-80-9	Intentional addition / 1,000ppm	chemical products
8454	Calcium chromate	13765-19-0	Contains (regardless of intentional or impurities)	chemical products
8455	Ammonium sulphamate	13765-36-1	Intentional addition / 1%	chemical products
8456	Molybdenum disilver tetraoxide	13765-74-7	Contains (regardless of intentional or impurities)	chemical products
8457	Phosphoric acid, zirconium salt	13765-95-2	Contains (regardless of intentional or impurities)	chemical products
8458	Diboron dioxide	13766-28-4	Intentional addition / 1%	chemical products
8459	Magnesium molybdate	13767-03-8	Contains (regardless of intentional or impurities)	chemical products
8460	Molybdenum zinc oxide (MoZnO4)	13767-32-3	Contains (regardless of intentional or impurities)	chemical products
8461	Copper molybdenum tetraoxide	13767-34-5	Contains (regardless of intentional or impurities)	chemical products
8462	Boric acid, magnesium salt (2:3)	13767-68-5	Intentional addition / 1%	chemical products
8463	Copper iodide (CuI2)	13767-71-0	Intentional addition / 1,000ppm	chemical products
8464	Actinolite	13768-00-8	Intentional addition / 1,000ppm	chemical products
8465	Borane(1), fluoro-	13768-60-0	Contains (regardless of intentional or impurities)	chemical products
8466	Szabalyite	13768-64-4	Intentional addition / 1%	chemical products
8467	Selenium trioxide	13768-86-0	Contains (regardless of intentional or impurities)	chemical products
8468	Potassium perborate	13769-41-0	Intentional addition / 1%	chemical products
8469	Vanadate (VO31-), potassium (1:1)	13769-43-2	Contains (regardless of intentional or impurities)	chemical products
8470	Iron molybdenum oxide (Fe2Mo3O12)	13769-81-8	Contains (regardless of intentional or impurities)	chemical products
8471	Perchloric acid, manganese(2+) salt	13770-16-6	Contains (regardless of intentional or impurities)	chemical products
8472	Perchloric acid, copper(2+) salt	13770-18-8	Intentional addition / 1,000ppm	chemical products
8473	Boric acid (HBO2), calcium salt (2:1), hexahydrate	13770-24-6	Intentional addition / 1%	chemical products
8474	Indium nitrate	13770-61-1	Contains (regardless of intentional or impurities)	chemical products
8475	Sulfamic acid, barium salt (2:1)	13770-86-0	Contains (regardless of intentional or impurities)	chemical products
8476	Sulfamic acid, nickel(2+) salt (2:1)	13770-89-3	Contains (regardless of intentional or impurities)	chemical products
8477	Sulfamic acid, zinc salt (2:1)	13770-90-6	Intentional addition / 1%	chemical products
8478	Phosphoric acid, zirconium(4+) salt (2:1)	13772-29-7	Contains (regardless of intentional or impurities)	chemical products
8479	Yttrium(III) nitrate, tetrahydrate	13773-69-8	Intentional addition / 1%	chemical products
8480	Boric acid (H3BO3), trillithium salt	13774-56-6	Intentional addition / 1%	chemical products
8481	Uranium fluoride (UF3)	13775-06-9	Contains (regardless of intentional or impurities)	chemical products
8482	Uranium fluoride (UF5)	13775-07-0	Contains (regardless of intentional or impurities)	chemical products
8483	Uranium iodide (UI3)	13775-18-3	Contains (regardless of intentional or impurities)	chemical products
8484	Aluminate(3-), hexafluoro-, trisodium, (OC-6-11)-	13775-53-6	Contains (regardless of intentional or impurities)	chemical products
8485	Dimickel orthosilicate	13775-54-7	Contains (regardless of intentional or impurities)	chemical products
8486	Hydrazine, monohydrobromide	13775-80-9	Contains (regardless of intentional or impurities)	chemical products
8487	Antimonate(3-), tetrathioxo-, trisodium, (T-4)-	13776-84-6	Contains (regardless of intentional or impurities)	chemical products
8488	Hafnium bromide (HfBr4)	13777-22-5	Intentional addition / 1%	chemical products
8489	Hafnium iodide (HfI4)	13777-23-6	Intentional addition / 1%	chemical products
8490	Zirconium bromide (ZrBr4), (T-4)-	13777-25-8	Contains (regardless of intentional or impurities)	chemical products
8491	Nitric acid, nickel(2+) salt, hydrate	13778-29-5	Contains (regardless of intentional or impurities)	chemical products
8492	Nitrous acid, calcium salt	13780-06-8	Contains (regardless of intentional or impurities)	chemical products
8493	Selenious acid, calcium salt (1:1)	13780-18-2	Contains (regardless of intentional or impurities)	chemical products
8494	Calcium diuranium heptaoxide	13780-21-7	Contains (regardless of intentional or impurities)	chemical products
8495	Boric acid (HB(OH)2)	13780-71-7	Intentional addition / 1%	chemical products
8496	3-Thienylacetone	13781-53-8	Intentional addition	chemical products
8497	Cobaltate(3-), hexakis(nitro-N)-, tripotassium, (OC-6-11)-	13782-01-9	Intentional addition / 1,000ppm	chemical products
8498	(OC-6-22)-Pentaamine(nitro-N)cobalt dichloride	13782-02-0	Intentional addition / 1%	chemical products
8499	Zirconate(1-), pentafluoro-, potassium	13782-18-8	Contains (regardless of intentional or impurities)	chemical products
8500	Sodium, (trifluoroacetate)	13782-22-4	Intentional addition / 1,000ppm	chemical products
8501	Rhodium chloride (RhCl2)	13783-12-5	Intentional addition / 1%	chemical products
8502	Nickel fluoride (NiF)	13783-64-7	Contains (regardless of intentional or impurities)	chemical products
8503	Hydrazine, diperchlorate	13812-39-0	Intentional addition / 1,000ppm	chemical products
8504	Telluric acid (H2TeO3), calcium salt (1:1)	13812-57-2	Contains (regardless of intentional or impurities)	chemical products
8505	Telluric acid (H2TeO3), copper(2+) salt (1:1)	13812-58-3	Contains (regardless of intentional or impurities)	chemical products
8506	Boric acid (H31BO3)	13813-78-0	Intentional addition / 1%	chemical products
8507	[10b]Orthoboric acid	13813-79-1	Intentional addition / 1%	chemical products
8508	Beryllium chloride (BeCl)	13814-50-1	Intentional addition / 1,000ppm	chemical products
8509	Selenious acid, cadmium salt (1:1)	13814-59-0	Contains (regardless of intentional or impurities)	chemical products
8510	Selenic acid, cadmium salt (1:1)	13814-62-5	Contains (regardless of intentional or impurities)	chemical products
8511	Molybdenum(VI) tetrachloride oxide	13814-75-0	Intentional addition / 1%	chemical products
8512	Silicic acid (H2SiO3), zinc salt (1:1)	13814-85-2	Intentional addition / 25%	chemical products
8513	Sulfuric acid, ammonium zinc salt (2:2:1)	13814-87-4	Intentional addition / 1%	chemical products
8514	Calcium tetrafluoroborate(1-)	13814-93-2	Intentional addition / 1,000ppm	chemical products
8515	Borate(1-), tetrafluoro-, tin(2+) (2:1)	13814-97-6	Contains (regardless of intentional or impurities)	chemical products
8516	Strontium fluoroborate	13814-98-7	Contains (regardless of intentional or impurities)	chemical products
8517	Iron(2+), hexaamine-, dichloride, (OC-6-11)-	13815-13-9	Intentional addition / 1%	chemical products
8518	Tripotassium hexafluoroferrate(3-)	13815-30-0	Intentional addition / 1%	chemical products
8519	Triammonium hexafluorovanadate(III)	13815-31-1	Intentional addition / 1%	chemical products
8520	Platinate(2-), tetrakis(nitro-N)-, dipotassium, (SP-4-1)-	13815-39-9	Contains (regardless of intentional or impurities)	chemical products
8521	Stibine, iodothioxo-	13816-38-1	Contains (regardless of intentional or impurities)	chemical products
8522	Manganese difluoride tetrahydrate	13817-36-2	Contains (regardless of intentional or impurities)	chemical products
8523	Cobalt(II) fluoride tetrahydrate	13817-37-3	Intentional addition / 1%	chemical products
8524	(OC-6-11)-Hexaaminenechromium trichloride	13820-25-2	Intentional addition / 1,000ppm	chemical products
8525	Ammonium tetrachloroplatinate	13820-41-2	Contains (regardless of intentional or impurities)	chemical products
8526	Platinum(2+), tetraamine-, (SP-4-1)-, (SP-4-1)-tetrachloroplatinate(2-), (1:1)	13820-46-7	Contains (regardless of intentional or impurities)	chemical products
8527	Platinate(2-), tetrachloro-, dirubidium, (SP-4-1)-	13820-56-9	Contains (regardless of intentional or impurities)	chemical products
8528	Rhodium(2+), pentaaminechloro-, dichloride, (OC-6-22)-	13820-95-6	Contains (regardless of intentional or impurities)	chemical products
8529	Hexaaminerhodium trichloride	13820-96-7	Contains (regardless of intentional or impurities)	chemical products
8530	Dibarium hexacyanoferrate	13821-06-2	Contains (regardless of intentional or impurities)	chemical products
8531	Ferrate(4-), hexakis(cyano-C)-, calcium (1:2), (OC-6-11)-	13821-08-4	Contains (regardless of intentional or impurities)	chemical products
8532	Ferrate(4-), hexakis(cyano-kappa-O)-, cobalt(2+) potassium (1:1:2), (OC-6-11)-	13821-10-8	Intentional addition / 1%	chemical products
8533	Bis(acetato-O)diamminecopper	13822-80-5	Intentional addition / 1,000ppm	chemical products
8534	Sulfuric acid, zirconium(2+) salt (1:1)	13824-85-6	Contains (regardless of intentional or impurities)	chemical products
8535	Nitrous acid, rubidium salt	13825-25-7	Intentional addition / 1,000ppm	chemical products
8536	Chromium(II) sulfate	13825-86-0	Contains (regardless of intentional or impurities)	chemical products
8537	1-Dodecanilium, N-(2-hydroxyethyl)-N,N-dimethyl-, perchlorate(salt)	13826-05-6	Intentional addition / 1,000ppm	chemical products
8538	Bis(catecholato)diboron	13826-27-2	Intentional addition / 1%	chemical products
8539	Phosphoric acid, potassium zinc salt (1:1:1)	13826-55-6	Intentional addition / 25%	chemical products
8540	Thallium nitrate	13826-63-6	Intentional addition / 1,000ppm	chemical products
8541	Zirconyl nitrate	13826-66-9	Contains (regardless of intentional or impurities)	chemical products
8542	Lanthanum trivanadium nonaoxide	13826-78-3	Intentional addition / 1%	chemical products
8543	Ammonium fluoroborate	13826-83-0	Contains (regardless of intentional or impurities)	chemical products
8544	Borate(1-), tetrafluoro-, nitryl	13826-86-3	Intentional addition / 1,000ppm	chemical products
8545	Borate(1-), tetrafluoro-, zinc (2:1)	13826-88-5	Contains (regardless of intentional or impurities)	chemical products
8546	Platinate(2-), tetrabromo-, dipotassium, (SP-4-1)-	13826-94-3	Contains (regardless of intentional or impurities)	chemical products
8547	Dilithium tetrabromonickelate(II)	13826-95-4	Contains (regardless of intentional or impurities)	chemical products
8548	Cadmium dicitrate	13832-25-2	Contains (regardless of intentional or impurities)	chemical products
8549	Nicotine, compound with aluminum bromide	13837-13-3	Contains (regardless of intentional or impurities)	chemical products
8550	Nicotine, compound with aluminum chloride	13837-14-4	Contains (regardless of intentional or impurities)	chemical products
8551	Enflurane	13838-16-9	Intentional addition / 1%	chemical products
8552	Boric acid (H3BO3), barium salt (2:3)	13840-10-3	Intentional addition / 1,000ppm	chemical products
8553	Boric acid (H3BO3), calcium salt	13840-55-6	Intentional addition / 1%	chemical products
8554	Boron dioxide	13840-88-5	Intentional addition / 1%	chemical products
8555	(OC-6-11)-Hexaaminene-cobalt trifluoride	13841-80-0	Intentional addition / 1%	chemical products
8556	Platinum, diaminediiodo-	13841-96-8	Contains (regardless of intentional or impurities)	chemical products
8557	Nickel dipotassium bis(sulphate)	13842-46-1	Contains (regardless of intentional or impurities)	chemical products
8558	Ammonium bromate	13843-59-9	Intentional addition / 1%	chemical products
8559	Lithium dichromate	13843-81-7	Contains (regardless of intentional or impurities)	chemical products
8560	Rhodate(3-), hexachloro-, tripotassium, (OC-6-11)-	13845-07-3	Contains (regardless of intentional or impurities)	chemical products
8561	Barium dithionate	13845-17-5	Contains (regardless of intentional or impurities)	chemical products
8562	Hydrogen sulfide (H2S3)	13845-23-3	Intentional addition / 1%	chemical products
8563	Hydrogen sulfide (H2S5)	13845-24-4	Intentional addition / 1%	chemical products
8564	Hydrogen sulfide (H2S4)	13845-25-5	Intentional addition / 1%	chemical products
8565	Hydrogen sulfide (H2S6)	13845-51-7	Intentional addition / 1%	chemical products
8566	Phosphoric acid, cadmium salt	13847-17-1	Contains (regardless of intentional or impurities)	chemical products
8567	Phosphoric acid, barium salt	13847-18-2	Intentional addition / 1,000ppm	chemical products
8568	Phosphoric acid, zinc salt	13847-22-8	Intentional addition / 25%	chemical products
8569	Cobalt(2+), pentaaminechloro-, dichloride, (OC-6-22)-	13859-51-3	Intentional addition / 1,000ppm	chemical products
8570	Dipotassium tetrafluoronickelate(2-)	13859-60-4	Contains (regardless of intentional or impurities)	chemical products
8571	Ammonium pentafluorozirconate(1-)	13859-62-6	Contains (regardless of intentional or impurities)	chemical products
8572	Tetrakis(trifluorophosphine)nickel	13859-65-9	Contains (regardless of intentional or impurities)	chemical products
8573	Hexaaminenickel(II) iodide	13859-68-2	Contains (regardless of intentional or impurities)	chemical products
8574	Barium borofluoride	13862-62-9	Contains (regardless of intentional or impurities)	chemical products
8575	Copper fluoride hydroxide	13867-72-6	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
8576	Cobalt, [N-(carboxymethyl)glycinate(2-)-N.O.ON]-	13869-30-2	Intentional addition / 1,000ppm	chemical products
8577	Nickel, [N-(carboxymethyl)glycinate(2-)-N.O.ON]-	13869-33-5	Contains (regardless of intentional or impurities)	chemical products
8578	Bis(acetonitrile)dichloroplatinum	13869-38-0	Contains (regardless of intentional or impurities)	chemical products
8579	Iron tungsten oxide (FeWO4)	13870-24-1	Intentional addition / 1%	chemical products
8580	Cobamide	13870-90-1	Intentional addition / 1%	chemical products
8581	Sodium pentafluorozirconate(1-)	13871-10-8	Contains (regardless of intentional or impurities)	chemical products
8582	Disodium tetrafluoroberyllate	13871-27-7	Contains (regardless of intentional or impurities)	chemical products
8583	Aurate(1-), tetrachloro-, sodium, dihydrate	13874-02-7	Intentional addition	chemical products
8584	Ammonium tetrachloroaurate(III) hydrate	13874-02-7	Intentional addition	chemical products
8585	Lithium tetrafluoroberyllate	13874-38-7	Contains (regardless of intentional or impurities)	chemical products
8586	Sodium trifluorohydroxyborate(1-)	13876-07-6	Intentional addition / 1,000ppm	chemical products
8587	Potassium trifluorohydroxyborate(1-)	13876-88-7	Intentional addition / 1%	chemical products
8588	Borate(1-), tetrafluoro-, iron(2+), hexahydrate	13877-16-2	Intentional addition / 1%	chemical products
8589	Hexaamminenickel(2+) bis(tetrafluoroborate(1-))	13877-20-8	Contains (regardless of intentional or impurities)	chemical products
8590	Cuprate(2-), tetrachloro-, dipotassium	13877-24-2	Intentional addition / 1,000ppm	chemical products
8591	Potassium trichlorocuprate(1-)	13877-25-3	Intentional addition / 1,000ppm	chemical products
8592	Copper, bis(2,4-hexanedionate-O,O)-	13878-44-9	Intentional addition / 1,000ppm	chemical products
8593	Benzene, 1,2-diisocyanato-4-methyl-	13879-33-9	Intentional addition / 1%	chemical products
8594	Nicotine, compound with antimony chloride (SbCl5)	13890-80-7	Contains (regardless of intentional or impurities)	chemical products
8595	Nicotine, compound with zinc chloride	13890-83-0	Contains (regardless of intentional or impurities)	chemical products
8596	Nicotine, compound with cadmium chloride	13890-84-1	Contains (regardless of intentional or impurities)	chemical products
8597	Nicotine, compound with dichloroethylaluminum	13890-85-2	Contains (regardless of intentional or impurities)	chemical products
8598	Nicotine, compound with triethylaluminum	13890-86-3	Contains (regardless of intentional or impurities)	chemical products
8599	Nicotine, compound with chlorodiethylaluminum	13890-87-4	Contains (regardless of intentional or impurities)	chemical products
8600	Nicotine, compound with diethylzinc	13890-88-5	Contains (regardless of intentional or impurities)	chemical products
8601	Chromate (CrO42-)	13907-45-4	Contains (regardless of intentional or impurities)	chemical products
8602	Dichromate ion (Cr2O72-)	13907-47-6	Contains (regardless of intentional or impurities)	chemical products
8603	Arsenic acid, methylphenyl-	13911-65-4	Intentional addition / 100ppm	chemical products
8604	Fayalite (Fe2(SiO4))	13918-37-1	Intentional addition / 1%	chemical products
8605	Boric acid, B-1-naphthalenyl-	13922-41-3	Intentional addition / 1%	chemical products
8606	Bis(dibutylthiocarbamate-S,S')copper	13927-71-4	Intentional addition / 1,000ppm	chemical products
8607	Nickel, bis(dibutylcarbamodithioato-S,S'), (SP-4-1)-	13927-77-0	Contains (regardless of intentional or impurities)	chemical products
8608	Vanadium, oxo[29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-5-12)-	13930-88-6	Intentional addition / 1%	chemical products
8609	Tin chloride (SnCl)	13931-79-8	Contains (regardless of intentional or impurities)	chemical products
8610	Nickel chloride (NiCl)	13931-83-4	Contains (regardless of intentional or impurities)	chemical products
8611	Dipotassium zinc bis(sulphate)	13932-17-7	Intentional addition / 1%	chemical products
8612	Copper(II) chloride, dihydrate	13933-17-0	Intentional addition / 1,000ppm	chemical products
8613	Perchloric acid, iron(2+) salt	13933-23-8	Intentional addition / 1,000ppm	chemical products
8614	Tetraamminedichloroplatinum(II)	13933-32-9	Contains (regardless of intentional or impurities)	chemical products
8615	9,10-Anthracenedione, 2-pentyl-	13936-21-5	Contains (regardless of intentional or impurities)	chemical products
8616	Carbonylchlorobis(triphenylphosphine)rhodium	13938-94-8	Contains (regardless of intentional or impurities)	chemical products
8617	Molybdenum carbonyl (Mo(CO)6), (OC-6-11)-	13939-06-5	Contains (regardless of intentional or impurities)	chemical products
8618	Iron(3+) sodium disulphate	13939-33-8	Intentional addition / 1%	chemical products
8619	Lanthanum vanadium tetraoxide	13939-40-7	Intentional addition / 1%	chemical products
8620	Nickel fluoride (NiF2), tetrahydrate	13940-83-5	Contains (regardless of intentional or impurities)	chemical products
8621	Ferrate(4-), hexakis(cyano-C)-, tetrapotassium, (OC-6-11)-	13943-58-3	Contains (regardless of intentional or impurities)	chemical products
8622	Cobaltate(3-), hexakis(cyano-C)-, tripotassium, (OC-6-11)-	13963-58-1	Contains (regardless of intentional or impurities)	chemical products
8623	Tris(diethylthiocarbamate-S,S')iron	13963-59-2	Intentional addition / 1%	chemical products
8624	Diborane(4), tetrafluoro-	13965-73-6	Intentional addition / 1%	chemical products
8625	Beryllium 7	13966-02-4	Contains (regardless of intentional or impurities)	chemical products
8626	Tin 113	13966-06-8	Contains (regardless of intentional or impurities)	chemical products
8627	Uranium 234	13966-29-5	Contains (regardless of intentional or impurities)	chemical products
8628	Manganese 54	13966-31-9	Contains (regardless of intentional or impurities)	chemical products
8629	Barium monofluoride	13966-70-6	Contains (regardless of intentional or impurities)	chemical products
8630	Cadmium chloride (CdCl)	13966-88-4	Contains (regardless of intentional or impurities)	chemical products
8631	Vanadium hydride	13966-82-3	Intentional addition / 1%	chemical products
8632	Indium iodide (InI)	13966-94-4	Intentional addition / 1%	chemical products
8633	Aurate(1-), bis(cyano-O)-, potassium	13967-50-5	Contains (regardless of intentional or impurities)	chemical products
8634	Zirconium 95	13967-71-0	Contains (regardless of intentional or impurities)	chemical products
8635	Strontium 85	13967-73-2	Contains (regardless of intentional or impurities)	chemical products
8636	Barium bromate	13967-90-3	Contains (regardless of intentional or impurities)	chemical products
8637	Antimony 127	13968-50-8	Contains (regardless of intentional or impurities)	chemical products
8638	Thallium 204	13968-51-9	Contains (regardless of intentional or impurities)	chemical products
8639	Cadmium molybdenum oxide (CdMoO4)	13972-88-4	Contains (regardless of intentional or impurities)	chemical products
8640	Hydroxylamine, sulfate (salt)	13973-61-0	Intentional addition / 1%	chemical products
8641	Iron vanadium tetraoxide	13977-56-5	Intentional addition / 1,000ppm	chemical products
8642	Holmium vanadium tetraoxide	13977-63-4	Intentional addition / 1%	chemical products
8643	Holmium trivanadium nonaoxide	13977-64-5	Intentional addition / 1%	chemical products
8644	Nickel chromium phosphate	13977-71-4	Contains (regardless of intentional or impurities)	chemical products
8645	Kartocid	13978-70-6	Intentional addition / 1,000ppm	chemical products
8646	Curium 244	13981-15-2	Contains (regardless of intentional or impurities)	chemical products
8647	Plutonium 238	13981-16-3	Contains (regardless of intentional or impurities)	chemical products
8648	Californium 252	13981-17-4	Contains (regardless of intentional or impurities)	chemical products
8649	Zirconium 89	13981-27-6	Contains (regardless of intentional or impurities)	chemical products
8650	Nickel 63	13981-37-8	Contains (regardless of intentional or impurities)	chemical products
8651	Barium 133	13981-41-4	Contains (regardless of intentional or impurities)	chemical products
8652	Cobalt 57	13981-50-5	Contains (regardless of intentional or impurities)	chemical products
8653	Yttrium 88	13982-36-0	Contains (regardless of intentional or impurities)	chemical products
8654	Radium 226	13982-63-3	Contains (regardless of intentional or impurities)	chemical products
8655	Krypton 85	13983-27-2	Contains (regardless of intentional or impurities)	chemical products
8656	Bis(L-methioninato-N,O)copper	13985-65-4	Intentional addition / 1,000ppm	chemical products
8657	Zinc fluoride, tetrahydrate	13986-18-0	Intentional addition / 1,000ppm	chemical products
8658	Phosphoric acid, zinc salt (2:1), dihydrate	13986-21-5	Intentional addition / 25%	chemical products
8659	Sulfuric acid, zinc salt (1:1), hexahydrate	13986-24-8	Intentional addition / 1,000ppm	chemical products
8660	Zirconium iodide (ZrI4)	13986-26-0	Contains (regardless of intentional or impurities)	chemical products
8661	Zirconium(IV) nitrate, pentahydrate	13986-27-1	Contains (regardless of intentional or impurities)	chemical products
8662	Yttrium phosphate	13990-54-0	Contains (regardless of intentional or impurities)	chemical products
8663	Copper acrylate	13991-90-7	Intentional addition / 1,000ppm	chemical products
8664	Cerium(IV) dioxalate	14007-60-4	Intentional addition	chemical products
8665	Hydrazine, hydrochloride	14011-37-1	Contains (regardless of intentional or impurities)	chemical products
8666	Sulfurous acid, copper(2+) salt (1:1)	14013-02-6	Intentional addition / 1,000ppm	chemical products
8667	Manganese molybdenum oxide (MnMoO4)	14013-15-1	Contains (regardless of intentional or impurities)	chemical products
8668	Selenious acid, sodium salt	14013-56-0	Contains (regardless of intentional or impurities)	chemical products
8669	Chloric acid, iron(3+) salt	14013-71-9	Intentional addition / 1%	chemical products
8670	Nitric acid, iron(2+) salt	14013-86-6	Intentional addition / 1,000ppm	chemical products
8671	Terbium(3+) perchlorate	14014-09-6	Intentional addition / 1,000ppm	chemical products
8672	Thulium(3+) perchlorate	14014-10-9	Intentional addition / 1,000ppm	chemical products
8673	Sulfamic acid, cadmium salt (2:1)	14017-38-8	Contains (regardless of intentional or impurities)	chemical products
8674	Copper sulfamate	14017-38-0	Intentional addition / 1,000ppm	chemical products
8675	Sulfamic acid, iron(2+) salt (2:1)	14017-39-1	Intentional addition / 1%	chemical products
8676	Sulfamic acid, cobalt(2+) salt (2:1)	14017-41-5	Intentional addition / 1,000ppm	chemical products
8677	Perchloric acid, lanthanum(3+) salt	14017-46-0	Intentional addition / 1,000ppm	chemical products
8678	Perchloric acid, cerium(3+) salt	14017-47-1	Intentional addition / 1,000ppm	chemical products
8679	Gadolinium(3+) perchlorate	14017-52-8	Intentional addition / 1,000ppm	chemical products
8680	Dysprosium(3+) perchlorate	14017-53-9	Intentional addition / 1,000ppm	chemical products
8681	Holmium(3+) perchlorate	14017-54-0	Intentional addition / 1,000ppm	chemical products
8682	Erbium(3+) perchlorate	14017-55-1	Intentional addition / 1,000ppm	chemical products
8683	Yttrium(3+) perchlorate	14017-56-2	Intentional addition / 1,000ppm	chemical products
8684	Zinc dichromate	14018-95-2	Contains (regardless of intentional or impurities)	chemical products
8685	Calcium selenate	14019-91-1	Contains (regardless of intentional or impurities)	chemical products
8686	Tris(ethylenediamine)rhodium trichloride	14023-02-0	Contains (regardless of intentional or impurities)	chemical products
8687	Cobalt(3+), hexaammine-, (OC-6-11)-, triacetate	14023-85-9	Intentional addition / 1,000ppm	chemical products
8688	Tripotassium hexakis(cyano-O)manganate	14023-90-6	Contains (regardless of intentional or impurities)	chemical products
8689	Hexacarbonylvanadium	14024-00-1	Intentional addition / 1%	chemical products
8690	Bis(pentane-2,4-dionato-O,O')iron	14024-17-0	Intentional addition / 1%	chemical products
8691	Iron, tris(2,4-pentanedionato-O,O'), (OC-6-11)-	14024-18-1	Intentional addition / 1%	chemical products
8692	Cobalt, bis(2,4-pentanedionato-O,O'), (T-4)-	14024-48-7	Intentional addition / 1%	chemical products
8693	Bis(pentane-2,4-dionato-O,O')chromium	14024-50-1	Contains (regardless of intentional or impurities)	chemical products
8694	Cuprate(2-), [[N,N'-1,2-ethanediybis(L-aspartato)](4-)-], hydrogen (1:2)	14024-52-3	Intentional addition / 1,000ppm	chemical products
8695	Manganese, bis(2,4-pentanedionato-O,O')	14024-58-9	Contains (regardless of intentional or impurities)	chemical products
8696	Dipotassium [[N,N'-ethylenebis[N-(carboxymethyl)glycinate]](4-)-N,N',O,O',ON,ON]cobaltate(2-)	14025-10-6	Intentional addition / 1,000ppm	chemical products
8697	Cobaltate(1-), [[N,N'-1,2-ethanediybis[N-(carboxymethyl)glycinate]](4-)-N,N',O,O',ON,ON]-, sodium, (OC-6-21)-	14025-11-7	Intentional addition / 1%	chemical products
8698	Cuprate(2-), [[N,N'-1,2-ethanediybis[N-(carboxymethyl)glycinate]](4-)-N,N',O,O',ON,ON]-, disodium, (OC-6-21)-	14025-15-1	Intentional addition / 1,000ppm	chemical products
8699	Decanoic acid, cobalt(2+) salt	14033-48-8	Intentional addition / 1%	chemical products
8700	Benzenamine, 4-methylbenzenesulfonate	14034-57-2	Contains (regardless of intentional or impurities)	chemical products
8701	Perboric acid (HBO(O2))	14034-78-7	Intentional addition / 1%	chemical products
8702	Phosphoric acid, manganese(2+) salt (4:5)	14038-34-7	Intentional addition / 1%	chemical products
8703	Ferric ferrocyanide	14038-43-8	Contains (regardless of intentional or impurities)	chemical products
8704	Tetrasilver hexacyanoferrate	14038-75-6	Intentional addition / 1%	chemical products
8705	Nickelate(2-), tetrakis(cyano-C)-, disodium, (SP-4-1)-	14038-85-8	Contains (regardless of intentional or impurities)	chemical products
8706	Calcium tetrakis(cyano-C)platanate	14038-86-9	Contains (regardless of intentional or impurities)	chemical products
8707	Cobaltate(3-), hexakis(cyano-C)-, trisodium, (OC-6-11)-	14039-23-7	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
8708	Boron, trihydro(tetrahydrofuran)-, (T-4)-	14044-65-6	Intentional addition / 1%	chemical products
8709	Benzoic acid, 4-borono-	14047-29-1	Intentional addition / 1%	chemical products
8710	Cobaltate(3-), hexakis(cyano-C)-, zinc (2:3), (OC-6-11)-	14049-79-7	Intentional addition / 1,000ppm	chemical products
8711	[5.alpha.,6.alpha.]-7,8-Didehydro-4,5-epoxy-3,8-dihydroxy-17,17-dimethylmorpholinium iodide	14054-17-2	Intentional addition / 1,000ppm	chemical products
8712	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-1)-	14055-02-8	Contains (regardless of intentional or impurities)	chemical products
8713	Etoporphyrin(II) nickel	14055-19-7	Contains (regardless of intentional or impurities)	chemical products
8714	Molybdenum(II) iodide	14055-74-4	Intentional addition / 1%	chemical products
8715	Bromocarbonylbis(triphenylphosphine)rhodium	14056-79-2	Contains (regardless of intentional or impurities)	chemical products
8716	Bismuth vanadium oxide (BIV04)	14059-33-7	Intentional addition / 1%	chemical products
8717	Bismuth tri(perchlorate)	14059-45-1	Intentional addition / 1,000ppm	chemical products
8718	Yttrium(3+) orthoborate	14060-20-1	Intentional addition / 1%	chemical products
8719	Arsenous acid, trisodium salt	14060-38-9	Contains (regardless of intentional or impurities)	chemical products
8720	Scandium(3+) perchlorate	14066-05-8	Intentional addition / 1,000ppm	chemical products
8721	Boron praseodymium(3+) trioxide	14066-12-7	Intentional addition / 1%	chemical products
8722	Boron neodymium(3+) trioxide	14066-13-8	Intentional addition / 1%	chemical products
8723	Boron terbium(3+) trioxide	14066-17-2	Intentional addition / 1%	chemical products
8724	Cadmium hydrogen phosphate	14067-82-0	Contains (regardless of intentional or impurities)	chemical products
8725	[29H,31H-Phthalocyaninato(2-)-N29,N30,N31,N32]platinum	14075-08-2	Contains (regardless of intentional or impurities)	chemical products
8726	Borate(1-), tetrafluoro- potassium	14075-53-7	Contains (regardless of intentional or impurities)	chemical products
8727	Dichlorotetrakis(pyridine)rhodium chloride	14077-30-6	Contains (regardless of intentional or impurities)	chemical products
8728	Borane, chlorobis(1-methylethyl)-	14089-96-4	Intentional addition / 1%	chemical products
8729	Borane, butyldichloro-	14090-22-3	Intentional addition / 1%	chemical products
8730	Manganese 52	14092-99-0	Contains (regardless of intentional or impurities)	chemical products
8731	Hafnium 172	14093-11-9	Contains (regardless of intentional or impurities)	chemical products
8732	Dichloro(ethylenediamine)platinum	14096-51-6	Contains (regardless of intentional or impurities)	chemical products
8733	Tricarbonylnitrosylcobalt	14096-82-3	Intentional addition / 1%	chemical products
8734	Bis(quinolin-8-olato-N1,O8)nickel	14100-15-3	Contains (regardless of intentional or impurities)	chemical products
8735	Pentacarbonylchloromanganese	14100-30-2	Contains (regardless of intentional or impurities)	chemical products
8736	Vanadate (VO31-), calcium (2:1)	14100-64-2	Intentional addition / 1%	chemical products
8737	Borate(1-), tetrafluoro-, silver(1+)	14104-20-2	Contains (regardless of intentional or impurities)	chemical products
8738	Iron nitrate	14104-77-9	Intentional addition / 1,000ppm	chemical products
8739	Magnesium dichromate	14104-85-9	Contains (regardless of intentional or impurities)	chemical products
8740	Ytterbium(3+) orthoborate	14104-97-3	Intentional addition / 1%	chemical products
8741	Cadmium 109	14109-32-1	Contains (regardless of intentional or impurities)	chemical products
8742	Mercurate(1-), chloro(4-sulfohenyl)-, sodium	14110-97-5	Intentional addition / 1,000ppm	chemical products
8743	Diiodooxozirconium	14118-83-3	Contains (regardless of intentional or impurities)	chemical products
8744	Molybdenum 93	14119-13-2	Contains (regardless of intentional or impurities)	chemical products
8745	Molybdenum 99	14119-15-4	Contains (regardless of intentional or impurities)	chemical products
8746	Cobaltate(3-), hexakis(cyano-C)-, cobalt(2+), (OC-6-11)-	14123-08-1	Contains (regardless of intentional or impurities)	chemical products
8747	Selenate ion	14124-68-6	Contains (regardless of intentional or impurities)	chemical products
8748	Cobalt, dibromobis(triphenylphosphine)-, (T-4)-	14126-32-0	Intentional addition / 1,000ppm	chemical products
8749	Dibromobis(triphenylphosphine)nickel(II)	14126-37-5	Contains (regardless of intentional or impurities)	chemical products
8750	Copper, bis(1-phenyl-1,3-butandionato-O,O')-	14128-84-8	Intentional addition / 1,000ppm	chemical products
8751	Bis(1-phenylbutane-1,3-dionato-O,O')cobalt	14128-95-1	Intentional addition / 1,000ppm	chemical products
8752	Nicotine, compound with antimony chloride	14129-12-5	Contains (regardless of intentional or impurities)	chemical products
8753	Nicotine, compound with aluminum iodide	14129-13-6	Contains (regardless of intentional or impurities)	chemical products
8754	Technetium 99	14133-76-7	Contains (regardless of intentional or impurities)	chemical products
8755	Trimanganese bis(orthophosphate)	14154-09-7	Contains (regardless of intentional or impurities)	chemical products
8756	Nonane, 1-bromo-4-methyl-	14159-09-2	Intentional addition / 1,000ppm	chemical products
8757	Indium trifluoride trihydrate	14166-78-0	Contains (regardless of intentional or impurities)	chemical products
8758	Copper, [(2-)-[1,2-ethanedivylbis(nitriromethylidene)]bis(phenolato)](2--N,N,O,O')-, (SP-4-2)-	14167-15-8	Intentional addition / 1,000ppm	chemical products
8759	Salcomine	14167-18-1	Contains (regardless of intentional or impurities)	chemical products
8760	N,N-Bis(salicylidene)ethylenediaminonickel(II)	14167-20-5	Contains (regardless of intentional or impurities)	chemical products
8761	Ferrate(3-), hexakis(cyano-C)-, magnesium (2:3), (OC-6-11)-	14170-30-0	Contains (regardless of intentional or impurities)	chemical products
8762	[5,10,15,20-Tetraphenyl-21H,23H-porphinato(2-)-N21,N22,N23,N24]cobalt	14172-90-8	Intentional addition / 1,000ppm	chemical products
8763	[5,10,15,20-Tetraphenyl-21H,23H-porphinato(2-)-N21,N22,N23,N24]copper	14172-91-9	Intentional addition / 1,000ppm	chemical products
8764	[5,10,15,20-Tetraphenyl-21H,23H-porphine nickel(II)	14172-92-0	Contains (regardless of intentional or impurities)	chemical products
8765	Manganese tungsten oxide (MnW04)	14177-46-9	Contains (regardless of intentional or impurities)	chemical products
8766	Nickel tungsten oxide (NiW04)	14177-51-6	Contains (regardless of intentional or impurities)	chemical products
8767	Molybdenum nickel oxide (MoNiO4)	14177-55-0	Contains (regardless of intentional or impurities)	chemical products
8768	Cadmium iodide (CdI)	14184-47-5	Contains (regardless of intentional or impurities)	chemical products
8769	Molybdenum 101	14191-83-4	Contains (regardless of intentional or impurities)	chemical products
8770	4-Hydroxyphenylacetone nitrile	14191-95-8	Contains (regardless of intentional or impurities)	chemical products
8771	Titanium oxalate (2:3)	14194-07-1	Intentional addition / 1,000ppm	chemical products
8772	N-Ethyl-methyl-(2-chloro-4-methylmercaptophenyl)-thiophosphoramidate	14202-66-5	Intentional addition	chemical products
8773	Chloro[tris(2,2-dimethylpropyl)]stannane	14208-54-9	Contains (regardless of intentional or impurities)	chemical products
8774	Dibutylbis(2-hydroxybenzoyl)stannane	14214-24-5	Contains (regardless of intentional or impurities)	chemical products
8775	Isothiocyanate-2-chloro-2-propenyl	14214-31-4	Contains (regardless of intentional or impurities)	chemical products
8776	Sulfuric acid, beryllium salt (1:1), dihydrate	14215-00-0	Contains (regardless of intentional or impurities)	chemical products
8777	Copper azide (Cu(N3)2)	14215-30-6	Intentional addition / 1,000ppm	chemical products
8778	Nitric acid, cobalt salt	14216-74-1	Intentional addition / 1%	chemical products
8779	Nickel nitrate	14216-75-2	Contains (regardless of intentional or impurities)	chemical products
8780	Chromic acid, beryllium salt (1:1)	14216-88-7	Contains (regardless of intentional or impurities)	chemical products
8781	Cobaltate(4-), hexakis(cyano-C)-, tetrasodium, (OC-6-11)-	14217-00-6	Contains (regardless of intentional or impurities)	chemical products
8782	Ferrate(3-), hexakis(cyano-C)-, trisodium, (OC-6-11)-	14217-21-1	Contains (regardless of intentional or impurities)	chemical products
8783	Benzene, 1,3-diisocyanato-5-methyl-	14219-05-7	Intentional addition / 1%	chemical products
8784	(Pentane-2,4-dionato-O,O')thallium	14219-90-0	Contains (regardless of intentional or impurities)	chemical products
8785	Nickel potassium cyanide	14220-17-8	Contains (regardless of intentional or impurities)	chemical products
8786	Strontium bis(oxalato(2-)-O,O')oxotitanate(2-)	14220-20-3	Intentional addition	chemical products
8787	Bis(benzonitrile)palladium chloride	14220-64-5	Contains (regardless of intentional or impurities)	chemical products
8788	Nickel, tetrakis(triphenyl phosphite-P)-, (T-4)-	14221-00-2	Contains (regardless of intentional or impurities)	chemical products
8789	Tetrakis(mu-(acetato-O,O'))dimolybdenum	14221-06-8	Contains (regardless of intentional or impurities)	chemical products
8790	Triammonium tris(oxalato)ferrate(3-)	14221-47-7	Intentional addition / 1,000ppm	chemical products
8791	Ferrate(3-), hexakis(cyano-C)-, triammonium, (OC-6-11)-	14221-48-8	Contains (regardless of intentional or impurities)	chemical products
8792	Nicotine, compound with iron chloride	14222-24-3	Contains (regardless of intentional or impurities)	chemical products
8793	1-(Cyanooacetate)pyrrolidine	14227-95-3	Intentional addition	chemical products
8794	Oxirane, 2,2'-(1,4-cyclohexanedibis(methyleneoxymethylene))bis-	14228-73-0	Contains (regardless of intentional or impurities)	chemical products
8795	C.I. Solvent Blue 36	14233-37-5	Intentional addition / 1%	chemical products
8796	Yttrium 91	14234-24-3	Contains (regardless of intentional or impurities)	chemical products
8797	Antimony 125	14234-35-6	Contains (regardless of intentional or impurities)	chemical products
8798	4-Ethynylaniline	14235-81-5	Intentional addition / 1%	chemical products
8799	Hydrargaphen	14235-86-0	Contains (regardless of intentional or impurities)	chemical products
8800	Cobaltate(3-), tris(ethanedioato(2--O,O)-, tripotassium, (OC-6-11)-	14239-07-7	Intentional addition / 1%	chemical products
8801	Cadmium diethyldithiocarbamate	14239-68-0	Contains (regardless of intentional or impurities)	chemical products
8802	trans-Dinitrobis(ethylenediamine)cobalt(III) nitrate	14240-12-1	Intentional addition / 1%	chemical products
8803	Cuprate(1-), [29H,31H-phthalocyanine-2-carboxylato(3-)-N29,N30,N31,N32]-, hydrogen, (SP-4-2)-	14241-92-0	Intentional addition / 1,000ppm	chemical products
8804	Perchloric acid, silver(1+) salt, monohydrate	14242-05-8	Intentional addition / 1,000ppm	chemical products
8805	Tris(3-methylpentane-2,4-dionato-O,O')chromium	14244-35-0	Intentional addition / 1,000ppm	chemical products
8806	Zinc potassium cyanide	14244-82-3	Contains (regardless of intentional or impurities)	chemical products
8807	3,5-Dimethyl-4-nitropyridine 1-oxide	14248-66-9	Intentional addition / 1%	chemical products
8808	Tin tetrabutoxalate	14254-05-8	Contains (regardless of intentional or impurities)	chemical products
8809	Stearane, butoxydibutylchloro-	14254-22-9	Contains (regardless of intentional or impurities)	chemical products
8810	Oxalic acid, ammonium salt	14258-49-2	Intentional addition / 1,000ppm	chemical products
8811	Bis(6-methylheptane-2,4-dionato-O,O')manganese	14263-16-2	Contains (regardless of intentional or impurities)	chemical products
8812	Aurate(1-), tetrakis(cyano-C)-, potassium, (SP-4-1)-	14263-59-3	Contains (regardless of intentional or impurities)	chemical products
8813	Titanate(2-), bis(ethanedioato(2--O,O)oxo-barium, tetrahydrate, (SP-5-21)-	14263-82-8	Intentional addition	chemical products
8814	Potassium cyanocuprate(II) (K3Cu(CN)4)	14263-73-1	Contains (regardless of intentional or impurities)	chemical products
8815	Iron(2+), tris(2,2'-bipyridine-N,N')-, (OC-6-11)-, sulfate (1:1)	14263-81-1	Intentional addition / 1%	chemical products
8816	Nickel, dichlorobis(triphenylphosphine)-	14264-16-5	Contains (regardless of intentional or impurities)	chemical products
8817	Cuprate(2-), tris(cyano-kappa-C)-, potassium (1:2)	14264-30-3	Intentional addition / 1,000ppm	chemical products
8818	Cuprate(2-), tris(cyano-kappa-C)-, sodium (1:2)	14264-31-4	Contains (regardless of intentional or impurities)	chemical products
8819	Selenium 75	14265-71-5	Contains (regardless of intentional or impurities)	chemical products
8820	Nickel, bis(diethylcarbamodithioato-S,S')-, (SP-4-1)-	14267-17-5	Contains (regardless of intentional or impurities)	chemical products
8821	Thorium 230	14269-63-7	Contains (regardless of intentional or impurities)	chemical products
8822	Yttrium 87	14274-68-1	Contains (regardless of intentional or impurities)	chemical products
8823	Indium bromide (InBr)	14280-53-6	Intentional addition / 1%	chemical products
8824	Tripotassium hexakis(thiocyanato-N)chromate(3-)	14282-33-8	Contains (regardless of intentional or impurities)	chemical products
8825	Copper(2+), tetraamine-, sulfate (1:1)	14283-05-7	Intentional addition / 1,000ppm	chemical products
8826	Borate(1-), tetrafluoro-, lithium	14283-07-9	Contains (regardless of intentional or impurities)	chemical products
8827	(OC-6-22)-Pentaaminebromocobalt dibromide	14283-12-6	Intentional addition / 1%	chemical products
8828	Copper, bis(ethyl 3-oxobutanato-O1,O3)-	14284-06-1	Intentional addition / 1,000ppm	chemical products
8829	Silicic acid (H2SiO3), calcium zirconium(4+) salt (4:2:1)	14284-24-3	Contains (regardless of intentional or impurities)	chemical products
8830	Manganese, tris(2,4-pentanedionato-O,O')-, (OC-6-11)-	14284-89-0	Contains (regardless of intentional or impurities)	chemical products
8831	Tris(pentane-2,4-dionato-O,O')molybdenum	14284-90-3	Contains (regardless of intentional or impurities)	chemical products
8832	Rhodium, tris(2,4-pentanedionato-O,O')-, (OC-6-11)-	14284-92-5	Contains (regardless of intentional or impurities)	chemical products
8833	Chloro[29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]iron	14285-56-4	Intentional addition / 1%	chemical products
8834	Cobaltate(4-), [29H,31H-phthalocyanine-2,9,16,23-tetrakisulfonato(6--N29,N30,N31,N32)-, tetrahydrogen, (SP-4-1)-	14285-59-7	Intentional addition / 1,000ppm	chemical products
8835	Cuprate(1-), [29H,31H-phthalocyanine-2-sulfonato(3--N29,N30,N31,N32)-, sodium, (SP-4-2)-	14285-61-1	Intentional addition / 1,000ppm	chemical products
8836	Platinum, diamminebis(nitrito-N)-	14286-02-3	Contains (regardless of intentional or impurities)	chemical products
8837	Dytridium disilicate	14286-95-4	Intentional addition / 1%	chemical products
8838	D-Fructose, 1-deoxy-, 6-(dihydrogen phosphate), barium salt (1:1)	14288-73-4	Contains (regardless of intentional or impurities)	chemical products
8839	Vanadate (VO43-), tripotassium, (T-4)-	14293-78-8	Contains (regardless of intentional or impurities)	chemical products
8840	C.I. Pigment Green 36	14302-13-7	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
8841	2-Decene, 1-bromo-	14304-30-4	Intentional addition / 1,000ppm	chemical products
8842	Arsenic 74	14304-78-0	Contains (regardless of intentional or impurities)	chemical products
8843	Chromic acid (H <sub>2</sub> CrO <sub>7</sub> ), calcium salt (1:1)	14307-33-6	Contains (regardless of intentional or impurities)	chemical products
8844	Lithium chromate	14307-35-8	Contains (regardless of intentional or impurities)	chemical products
8845	Bis(acetato-O)dihydroxyzirconium	14311-93-4	Contains (regardless of intentional or impurities)	chemical products
8846	Cadmium chromate	14312-00-6	Contains (regardless of intentional or impurities)	chemical products
8847	Iron, tris(N-hydroxy-N-nitrosobenzenamino-O-O)-	14319-01-8	Intentional addition / 1%	chemical products
8848	Chromium, tris(glycinato-N,O)-, (OC-6-21)-	14320-13-9	Intentional addition / 1,000ppm	chemical products
8849	Iron, tris(1-phenyl-1,3-butanediolato-O,O)-	14323-17-2	Intentional addition / 1%	chemical products
8850	Aurate(1-), tetrabromo-, potassium, (SP-4-1)-	14323-32-1	Intentional addition	chemical products
8851	Potassium tetracyanoplatinate(II) trihydrate	14323-38-5	Contains (regardless of intentional or impurities)	chemical products
8852	Nickelate(2-), tetrakis(cyano-C)-, dipotassium, monohydrate, (SP-4-1)-	14323-41-2	Contains (regardless of intentional or impurities)	chemical products
8853	Nickel, tetrakis(4-methylpyridine)bis(thiocyanato-kappa-N)-	14324-74-4	Contains (regardless of intentional or impurities)	chemical products
8854	Bis(1,1-trifluoroacetate-2,4-dionato-O,O)copper	14324-82-4	Intentional addition / 1,000ppm	chemical products
8855	Thallium(1+) benzoyleacetate	14324-88-0	Intentional addition / 1,000ppm	chemical products
8856	Cobalt protoporphyrin	14325-03-2	Intentional addition / 1%	chemical products
8857	Manganese, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-1)-	14325-24-7	Contains (regardless of intentional or impurities)	chemical products
8858	Chromium, tris(glycinato-N,O)-, (OC-6-22)-	14325-26-9	Intentional addition / 1,000ppm	chemical products
8859	Sulfamic acid, monosilver(1+) salt	14325-99-6	Intentional addition / 1,000ppm	chemical products
8860	Antimony 129	14331-88-5	Contains (regardless of intentional or impurities)	chemical products
8861	Vanadium 48	14331-97-6	Contains (regardless of intentional or impurities)	chemical products
8862	Nickel hydride (NiH)	14332-32-2	Contains (regardless of intentional or impurities)	chemical products
8863	Phosphonic acid, nickel(2+) salt (1:1)	14332-33-3	Intentional addition / 1,000ppm	chemical products
8864	Nickel hydrogen phosphate	14332-34-4	Contains (regardless of intentional or impurities)	chemical products
8865	Tin(II) phosphite	14332-39-9	Contains (regardless of intentional or impurities)	chemical products
8866	Zinc phosphite	14332-59-3	Intentional addition / 25%	chemical products
8867	Phosphoric acid, zinc salt (1:1)	14332-60-6	Intentional addition / 25%	chemical products
8868	Cadmium 113	14336-66-4	Contains (regardless of intentional or impurities)	chemical products
8869	Cadmium 115	14336-68-6	Contains (regardless of intentional or impurities)	chemical products
8870	Copper azide (Cu(N <sub>3</sub> ))	14336-80-2	Intentional addition / 1,000ppm	chemical products
8871	Perchloric acid, cerium(4+) salt	14338-93-3	Intentional addition / 1,000ppm	chemical products
8872	2-Amino-3,5-dibromothiobenzamide	14345-84-7	Contains (regardless of intentional or impurities)	chemical products
8873	2,1-Benzothiazol-3-amine, 5-nitro-	14346-19-1	Contains (regardless of intentional or impurities)	chemical products
8874	4-Benzoyloxy-3-nitroacetophenone	14347-05-8	Intentional addition / 1%	chemical products
8875	3-Ethyl-2-[3-(3-ethylthiazolidin-2-ylidene)prop-1-enyl]-4,5-dihydrothiazolium perchlorate	14350-47-1	Intentional addition / 1,000ppm	chemical products
8876	Diboric acid, cobalt(2+) salt (1:2)	14355-30-7	Intentional addition / 1%	chemical products
8877	Benzenesulfonic acid, 4-dodecyl-, ammonium salt	14356-33-3	Intentional addition / 1%	chemical products
8878	Copper, bis(2-hydroxybenzaldehyde oximate-N1,O2)-	14363-26-9	Intentional addition / 1,000ppm	chemical products
8879	Nickel, bis[2-(hydroxy-kappa-O)benzaldehyde oximate-kappa-N]-	14363-30-5	Contains (regardless of intentional or impurities)	chemical products
8880	5-Chloro-2-nitrobenzenethiol	14371-79-0	Intentional addition / 1%	chemical products
8881	Sulfuric acid, dysprosium(3+) salt (3:2)	14373-91-2	Intentional addition / 1%	chemical products
8882	Antimony 122	14374-79-9	Contains (regardless of intentional or impurities)	chemical products
8883	1-Phenylcyclobutanecarbonitrile	14377-68-5	Intentional addition	chemical products
8884	Barium 139	14378-25-7	Contains (regardless of intentional or impurities)	chemical products
8885	Rhodium 101	14378-53-1	Contains (regardless of intentional or impurities)	chemical products
8886	Promethium 147	14380-75-7	Contains (regardless of intentional or impurities)	chemical products
8887	Beryllium 10	14380-89-7	Contains (regardless of intentional or impurities)	chemical products
8888	Antimony 120	14391-68-5	Contains (regardless of intentional or impurities)	chemical products
8889	Calcium 47	14391-99-2	Contains (regardless of intentional or impurities)	chemical products
8890	Vanadium 49	14392-01-9	Contains (regardless of intentional or impurities)	chemical products
8891	Chromium 51	14392-02-0	Contains (regardless of intentional or impurities)	chemical products
8892	Manganese 51	14392-03-1	Contains (regardless of intentional or impurities)	chemical products
8893	Peroxydisulfuric acid ((HO)2(SO)2O2), barium salt (1:1)	14392-58-6	Intentional addition / 1%	chemical products
8894	Phosphoric acid, nickel(2+) salt (2:3)	14398-43-6	Contains (regardless of intentional or impurities)	chemical products
8895	Titanate(2-), bis(ethanedioato(2-)-O,O)oxo-, dipotassium, dihydrate	14402-97-6	Intentional addition	chemical products
8896	Dithion tetracyanoplatinate	14402-72-4	Contains (regardless of intentional or impurities)	chemical products
8897	Cadmiate(2-), tetrakis(cyano-C)-, dipotassium, (T-4)-	14402-75-6	Contains (regardless of intentional or impurities)	chemical products
8898	Ferrate(2-), pentakis(cyano-kappa-C)nitrosyl-, sodium (1:2), (OC-6-22)-	14402-89-2	Contains (regardless of intentional or impurities)	chemical products
8899	Indium, tris(2,4-pentanedionato-O,O)-, (OC-6-11)-	14405-45-9	Intentional addition / 1%	chemical products
8900	Bis(1,3-diphénylpropane-1,3-dionato-O,O)cobalt	14405-50-6	Intentional addition / 1,000ppm	chemical products
8901	Nickel, bis(1-nitroso-2-naphthalenolato-N1,O2)-, (T-4)-	14406-66-7	Contains (regardless of intentional or impurities)	chemical products
8902	Nickel, [(2,2,1,1-2-phenylenebis(nitrilomethylidene)bis(phenolato))(2-)-N,N,O,O]-	14406-71-4	Contains (regardless of intentional or impurities)	chemical products
8903	Diamminebis(nitrito-N)platinum	14409-61-1	Contains (regardless of intentional or impurities)	chemical products
8904	Benzidine hydrochloride	14414-68-7	Contains (regardless of intentional or impurities)	chemical products
8905	Tin phosphite	14417-93-7	Intentional addition / 1,000ppm	chemical products
8906	Nickel, bis[2-(ethylhexyl)carbamodithioato-S,S']-	14428-08-1	Contains (regardless of intentional or impurities)	chemical products
8907	Potassium trichlorocadmiate	14429-85-7	Intentional addition / 1,000ppm	chemical products
8908	Sodium ferrocyanide decahydrate	14434-22-1	Intentional addition / 1,000ppm	chemical products
8909	Nickel, bis(hexahydro-1H-azepine-1-carbodithioato-S,S)-, (SP-4-1)-	14434-67-4	Contains (regardless of intentional or impurities)	chemical products
8910	Magnesium tetracyanoplatinate	14444-56-5	Contains (regardless of intentional or impurities)	chemical products
8911	Chromic acid, ammonium salt	14445-91-1	Contains (regardless of intentional or impurities)	chemical products
8912	Strontium dipermanganate	14446-13-0	Contains (regardless of intentional or impurities)	chemical products
8913	Propyl cyanoacetate	14447-15-5	Intentional addition	chemical products
8914	Diphosphoric acid, nickel(2+) salt (1:2)	14448-18-1	Contains (regardless of intentional or impurities)	chemical products
8915	Nickel stearate	14448-69-2	Contains (regardless of intentional or impurities)	chemical products
8916	Iron fumarate	14451-00-4	Intentional addition / 1%	chemical products
8917	Perchloric acid, aluminum salt	14452-39-2	Intentional addition / 1,000ppm	chemical products
8918	Diboron	14452-61-0	Intentional addition / 1%	chemical products
8919	Hafnium(IV) oxychloride hydrate	14456-34-9	Intentional addition / 1%	chemical products
8920	Molybdenum zinc oxide (MoZn2O5)	14456-43-0	Contains (regardless of intentional or impurities)	chemical products
8921	Potassium antimonate	14459-60-0	Contains (regardless of intentional or impurities)	chemical products
8922	Ferrate(4-), hexakis(cyano-C)-, tetrapotassium, trihydrate, (OC-6-11)-	14459-95-1	Contains (regardless of intentional or impurities)	chemical products
8923	Ferrate(4-), hexakis(cyano-C)-, iron(2+) (1:2), (OC-6-11)-	14460-02-7	Contains (regardless of intentional or impurities)	chemical products
8924	Silica, cristobalite	14464-46-1	Contains (regardless of intentional or impurities)	chemical products
8925	2-Propenoic acid, manganese salt	14465-99-7	Contains (regardless of intentional or impurities)	chemical products
8926	Lactic acid, compound with (S)-[3-(1-methylpyrrolidin-2-yl)pyridine (1:1)]	14474-00-1	Contains (regardless of intentional or impurities)	chemical products
8927	Zirconium hydroxide (Zr(OH)4)	14475-63-9	Contains (regardless of intentional or impurities)	chemical products
8928	Zirconium sulfate	14475-73-1	Contains (regardless of intentional or impurities)	chemical products
8929	Propane, 1,2,2-tribromo-	14476-30-3	Intentional addition / 1,000ppm	chemical products
8930	Nicotine, ethylenebis(dithiocarbamate) (1:1)	14480-51-4	Contains (regardless of intentional or impurities)	chemical products
8931	Nickel(II) bis(2,2,6,6-tetramethyl-3,5-heptanedionate)	14481-08-4	Contains (regardless of intentional or impurities)	chemical products
8932	Titanate(2-), bis(ethanedioato(2-)-O,O)oxo-, dipotassium, (SP-5-21)-	14481-26-6	Intentional addition	chemical products
8933	Ferrate(4-), hexakis(cyano-C)-, tetraammonium, (OC-6-11)-	14481-29-9	Contains (regardless of intentional or impurities)	chemical products
8934	Copper(2+) hexacyanoferrate heptahydrate	14481-40-4	Intentional addition / 1,000ppm	chemical products
8935	Calcium nickel chromium phosphate	14482-69-0	Contains (regardless of intentional or impurities)	chemical products
8936	Ferbam	14484-64-1	Contains (regardless of intentional or impurities)	chemical products
8937	Borate(1-), tetraphenyl-, lithium	14485-20-2	Intentional addition / 1%	chemical products
8938	Phosphoric acid, manganese(2+) salt (4:5), tetrahydrate	14485-27-9	Intentional addition / 1%	chemical products
8939	Cadmium fluoroborate	14486-19-2	Contains (regardless of intentional or impurities)	chemical products
8940	Borate(1-), tetrafluoro-, antimony(3+) (3:1)	14486-20-5	Contains (regardless of intentional or impurities)	chemical products
8941	Dibutyltin	14486-53-0	Contains (regardless of intentional or impurities)	chemical products
8942	Nonanedioic acid, barium salt (1:1)	14488-59-6	Contains (regardless of intentional or impurities)	chemical products
8943	Chromosulfuric acid	14489-25-9	Intentional addition / 1,000ppm	chemical products
8944	Platinate(2-), tetrabromo-, (SP-4-1)-	14493-01-7	Contains (regardless of intentional or impurities)	chemical products
8945	Bis(quinolin-8-olato-N1,O8)manganese	14495-13-7	Contains (regardless of intentional or impurities)	chemical products
8946	Strychnidin-10-one, cyclohexylsulfamate	14504-57-5	Contains (regardless of intentional or impurities)	chemical products
8947	Chromic acid (H <sub>2</sub> CrO <sub>4</sub> ), iron(2+) salt (1:1)	14507-18-7	Intentional addition / 1,000ppm	chemical products
8948	Nickel bis(phosphinate)	14507-36-9	Contains (regardless of intentional or impurities)	chemical products
8949	Bromopentacarbonylmanganese	14516-54-2	Contains (regardless of intentional or impurities)	chemical products
8950	Nickel, (1-butanamine)[[2,2-thiobis[4-(1,1,3,3-tetramethylbutyl)phenolato]](2-)-O,O,S]-	14516-71-3	Contains (regardless of intentional or impurities)	chemical products
8951	Copper, [29H,31H-phthalocyanine-1,8,15,22-tetrasulfonyl tetrachloroato(2-)-N29,N30,N31,N32]-, (SP-4-1)-	14518-21-9	Intentional addition / 1,000ppm	chemical products
8952	Tricopper bis[hexa(cyano-c)cobaltate(3-)]	14518-26-4	Intentional addition / 1,000ppm	chemical products
8953	Cadmium bromate	14518-94-6	Contains (regardless of intentional or impurities)	chemical products
8954	Zinc bromate	14519-07-4	Contains (regardless of intentional or impurities)	chemical products
8955	Magnesium bromate	14519-17-6	Intentional addition / 1%	chemical products
8956	Strontium bromate	14519-18-7	Contains (regardless of intentional or impurities)	chemical products
8957	Phosphoric acid, ammonium cadmium salt (1:1:1)	14520-70-8	Contains (regardless of intentional or impurities)	chemical products
8958	Octafluorotrisilane	14521-14-3	Intentional addition / 1,000ppm	chemical products
8959	Bis(6-methylheptane-2,4-dionato-O,O)nickel	14522-99-7	Contains (regardless of intentional or impurities)	chemical products
8960	Bis(6-methylheptane-2,4-dionato-O,O)copper	14523-00-3	Intentional addition / 1,000ppm	chemical products
8961	Barium bis(oxalato(2-)-O,O)oxotitanate(2-)	14523-21-8	Contains (regardless of intentional or impurities)	chemical products
8962	Di-mu-chloro-bis(dicarbonylrhodium)	14523-22-9	Contains (regardless of intentional or impurities)	chemical products
8963	Copper, bis(2-hydroxybenzaldehyde-O,O)-	14523-25-2	Intentional addition / 1,000ppm	chemical products
8964	Arsenous chloride	14525-25-8	Contains (regardless of intentional or impurities)	chemical products
8965	Tris(dibutylthiocarbamate-S,S)iron	14526-32-0	Intentional addition / 1%	chemical products
8966	Benzoic acid, iron(3+) salt	14534-87-3	Intentional addition / 1%	chemical products
8967	Oxalic acid, zirconium salt	14536-19-7	Contains (regardless of intentional or impurities)	chemical products
8968	Ethanedioic acid, tin salt	14536-20-0	Intentional addition / 1,000ppm	chemical products
8969	Vanadium phosphite	14542-94-0	Intentional addition / 1%	chemical products
8970	Nicotine, compound with bis[2-(dithiocarboxy)amino]ethyl, dithiocarbamic acid (1:1)	14544-85-5	Contains (regardless of intentional or impurities)	chemical products
8971	Methanol, (phenylmethoxy)-	14548-60-8	Intentional addition / 100ppm	chemical products
8972	Nickel dibromate	14550-87-9	Contains (regardless of intentional or impurities)	chemical products
8973	Copper(2+), bis(1,2-ethanediamine-N,N)-, dihydroxide, (SP-4-1)-	14552-35-3	Intentional addition / 1,000ppm	chemical products

Table with 5 columns: #, Substance Name, CAS-No, Misumi Standards (numbers as threshold), and Applicable Item. It lists various chemical substances such as Dihydrogen bis(L-aspartato(2-))-N,O,04ferrate(2-), Cobaltate(4-), Benzene sulfonic acid, 4-dodecyl-, and many others, each with its corresponding CAS number and Misumi standard.

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
9104	Ferrate(2-), [7,12-diethenyl-3,8,13,17-tetramethyl-21H,23H-porphine-2,18-dipropanoate(4-)-N21,N22,N23,N24]-, dihydrogen, (SP-4-2)-	14875-96-8	Intentional addition / 1%	chemical products
9105	Disodium tetracarboxylferrate(2-)	14878-31-0	Intentional addition / 1%	chemical products
9106	Hexacarbonylbis[μ-(methanethiolato)]diiron	14878-96-7	Intentional addition / 1%	chemical products
9107	Tripotassium trioxaloferrate	14883-34-2	Intentional addition / 1%	chemical products
9108	Dizinc hexacyanoferrate	14883-46-6	Intentional addition / 1%	chemical products
9109	Vanadium(II) bromide	14890-41-6	Intentional addition / 1%	chemical products
9110	Cobaltate(3-), hexakis(cyano-kappa C)-, (OC-6-11)-	14897-04-2	Intentional addition / 1%	chemical products
9111	(R)-Butan-2-ol	14898-79-4	Contains (regardless of intentional or impurities)	chemical products
9112	Telluric acid (H2TeO3), barium salt (1:1)	14899-38-8	Contains (regardless of intentional or impurities)	chemical products
9113	Hafnium 181	14900-21-1	Contains (regardless of intentional or impurities)	chemical products
9114	Boronic acid, B-(1-phenylethyl)-	14900-39-1	Intentional addition / 1%	chemical products
9115	Beryllium selenate	14902-95-5	Contains (regardless of intentional or impurities)	chemical products
9116	4-Pyridinecarbonitrile, 1-oxide	14906-59-3	Intentional addition	chemical products
9117	Diamminedichloroplatinum	14913-33-8	Contains (regardless of intentional or impurities)	chemical products
9118	Rhodium 105	14913-89-4	Contains (regardless of intentional or impurities)	chemical products
9119	Antimony 119	14914-88-2	Contains (regardless of intentional or impurities)	chemical products
9120	Barium 131	14914-75-1	Contains (regardless of intentional or impurities)	chemical products
9121	Bis[1-hydroxy-1H-pyridine-2-thionato-O,S]copper	14915-37-8	Intentional addition / 100ppm	chemical products
9122	(OC-6-22)-Pentaaminezincocobalt dichloride	14916-48-4	Intentional addition / 1%	chemical products
9123	5-Hexenyne	14918-21-9	Intentional addition	chemical products
9124	Hafnium 170	14922-51-1	Contains (regardless of intentional or impurities)	chemical products
9125	Cadmium dicosanoate	14923-81-0	Contains (regardless of intentional or impurities)	chemical products
9126	Zirconium 97	14928-30-4	Contains (regardless of intentional or impurities)	chemical products
9127	Telluric acid (H2TeO3), dilithium salt	14929-89-2	Contains (regardless of intentional or impurities)	chemical products
9128	Cobaltate(2-), [[N,N'-1,2-ethanedilybisN-(carboxymethyl)glycinato]](4-)-N,N',O',O',ON,ON]-, (OC-6-21)-	14931-83-0	Intentional addition / 1,000ppm	chemical products
9129	Nickelate(2-), [[N,N'-1,2-ethanedilybisN-(carboxymethyl)glycinato]](4-)-N,N',O',O',ON,ON]-, (OC-6-21)-	14931-84-1	Contains (regardless of intentional or impurities)	chemical products
9130	Xenon 133	14932-42-4	Contains (regardless of intentional or impurities)	chemical products
9131	Phosphoric acid, iron(2+) salt (2:3)	14940-41-1	Intentional addition / 1%	chemical products
9132	Zircon	14940-68-2	Contains (regardless of intentional or impurities)	chemical products
9133	[R-(R*,R*)]-Tartaric acid, iron potassium salt	14948-71-1	Intentional addition / 1%	chemical products
9134	Cadmium bis(piperidine-1-carbodithioate)	14949-59-8	Contains (regardless of intentional or impurities)	chemical products
9135	Bis(dimethylthiocarbamato-S,S')cadmium	14949-60-1	Contains (regardless of intentional or impurities)	chemical products
9136	Bis(1,1,1,5,5,5-hexafluoropentane-2,4-dionato-O,O')nickel	14949-69-0	Contains (regardless of intentional or impurities)	chemical products
9137	4,4',6,6'-Tetrabromo[1,1'-biphenyl]-2,2'-diol	14957-65-4	Intentional addition / 1,000ppm	chemical products
9138	Copper vanadium oxide (CuV2O6)	14958-34-0	Intentional addition / 1,000ppm	chemical products
9139	Cobalt dilaurate	14960-16-8	Intentional addition / 1,000ppm	chemical products
9140	Cobalt cyanide (Co(CN)3)	14965-99-2	Contains (regardless of intentional or impurities)	chemical products
9141	Sodium hexachlorohydroxide(3-) hydrate (3:1:2)	14972-02-2	Intentional addition / 1%	chemical products
9142	Rhodate(3-), hexachloro-, trisodium, (OC-6-11)-	14972-70-4	Contains (regardless of intentional or impurities)	chemical products
9143	Bromotris(triphenylphosphine)rhodium	14973-89-8	Contains (regardless of intentional or impurities)	chemical products
9144	Chlorotris(triphenylarsine)rhodium	14973-92-3	Contains (regardless of intentional or impurities)	chemical products
9145	Ethanedioic acid, vanadium salt	14974-48-2	Intentional addition / 1,000ppm	chemical products
9146	Tin dilaurate	14974-55-1	Contains (regardless of intentional or impurities)	chemical products
9147	Bis(2,3-epoxypropyl)sulfide	14974-71-1	Intentional addition / 1%	chemical products
9148	Chromyl chloride	14977-61-8	Contains (regardless of intentional or impurities)	chemical products
9149	Yttrium 93	14981-70-5	Contains (regardless of intentional or impurities)	chemical products
9150	Chromium chloride hydroxide (CrCl2(OH))	14982-80-0	Intentional addition / 1,000ppm	chemical products
9151	Ethanol, 2-methoxy-, triester with boric acid (H3BO3)	14983-42-7	Intentional addition / 1%	chemical products
9152	Dodecane, 1,1,1,3-tetrachloro-	14983-90-9	Intentional addition / 1,000ppm	chemical products
9153	Nitrous acid, copper(2+) salt	14984-71-5	Intentional addition / 1,000ppm	chemical products
9154	Zirconium nitrate hydrate	14985-18-3	Intentional addition / 1,000ppm	chemical products
9155	Vanadium chloride (VCl5)	14986-47-1	Intentional addition / 1%	chemical products
9156	Chromium(VI) chloride	14988-48-2	Intentional addition / 1,000ppm	chemical products
9157	Selenic acid, magnesium salt (1:1)	14988-91-5	Contains (regardless of intentional or impurities)	chemical products
9158	Phosphoric acid, manganese(3+) salt (1:1)	14988-93-7	Intentional addition / 1%	chemical products
9159	Manganese vanadium oxide (MnV2O6)	14988-94-8	Contains (regardless of intentional or impurities)	chemical products
9160	Manganese vanadium oxide (Mn2V2O7)	14988-95-9	Contains (regardless of intentional or impurities)	chemical products
9161	[R-(R*,R*)]-Tartaric acid, manganese salt	14988-96-8	Contains (regardless of intentional or impurities)	chemical products
9162	Nickel acetate	14988-37-9	Contains (regardless of intentional or impurities)	chemical products
9163	Formic acid, manganese salt	14988-38-0	Contains (regardless of intentional or impurities)	chemical products
9164	Manganese 53	14989-33-8	Contains (regardless of intentional or impurities)	chemical products
9165	Ethylamine, N-ethyl-, perchlorate	14989-74-7	Intentional addition / 1,000ppm	chemical products
9166	Pyridinium, 1,1'-tetradecamethylene-di-, diperchlorate	15001-42-0	Intentional addition / 1,000ppm	chemical products
9167	Potassium hexacyanoruthenate	15002-31-0	Intentional addition	chemical products
9168	Chromium(III) sulphate hexahydrate	15005-90-0	Contains (regardless of intentional or impurities)	chemical products
9169	Sodium tin fluoride (Na2SnF4)	15007-55-3	Intentional addition / 1,000ppm	chemical products
9170	Boronic acid, B-(2-ethenylphenyl)-	15016-42-9	Intentional addition / 1%	chemical products
9171	Boronic acid, B-(3-ethenylphenyl)-	15016-43-0	Intentional addition / 1%	chemical products
9172	Bis(ethylselenyl)diiron tetrakis(rosyl)	15025-89-5	Contains (regardless of intentional or impurities)	chemical products
9173	1-(Cyanooctyl)piperidine	15029-30-8	Intentional addition	chemical products
9174	Cobalt(1+), tetraammine[carbonato(2-)-O,O']-, (OC-6-22)-, nitrate	15040-52-5	Intentional addition / 1%	chemical products
9175	Chlorocobalamin	15041-07-3	Intentional addition / 1%	chemical products
9176	Oxobis(pentane-2,4-dionato-O,O')zirconium	15041-14-2	Contains (regardless of intentional or impurities)	chemical products
9177	Iodine 129	15046-84-1	Contains (regardless of intentional or impurities)	chemical products
9178	Molybdenum potassium oxide (Mo3K2O10)	15059-53-7	Intentional addition / 1%	chemical products
9179	Molybdate(2-), tetrathio-, diammonium, (T-4)-	15060-55-6	Contains (regardless of intentional or impurities)	chemical products
9180	Vanadate (VO31-), lithium	15060-59-0	Intentional addition / 1%	chemical products
9181	Nickel selenate	15060-62-5	Contains (regardless of intentional or impurities)	chemical products
9182	Zinc phosphinate	15060-64-7	Intentional addition / 25%	chemical products
9183	Magnesium nitrite	15070-34-5	Intentional addition / 1,000ppm	chemical products
9184	Indate(1-), [[N,N'-1,2-ethanedilybisN-(carboxymethyl)glycinato]](4-)-N,N',O',O',ON,ON]-, sodium, (OC-6-21)-	15078-72-5	Intentional addition / 1%	chemical products
9185	Tellurium, bis(diethylcarbamodithioato-S,S')-, (SP-4-1)-	15080-52-1	Contains (regardless of intentional or impurities)	chemical products
9186	Tribenzyltin hydroxide	15082-85-6	Intentional addition / 1,000ppm	chemical products
9187	Chromium, tetrachloro-μ-(2-hydroxy[μ-(2-methyl-2-propenoato-O,O')]di-	15086-41-0	Contains (regardless of intentional or impurities)	chemical products
9188	Aluminum fluoride, trihydrate	15088-87-0	Contains (regardless of intentional or impurities)	chemical products
9189	Nitric acid, nickel(3+) salt	15089-34-0	Contains (regardless of intentional or impurities)	chemical products
9190	Propane, 1,1,2,3,3-pentachloro-	15104-61-7	Intentional addition / 1,000ppm	chemical products
9191	Zirconium bis(2-ethylhexanoate) oxide	15104-99-1	Contains (regardless of intentional or impurities)	chemical products
9192	Uranium 235	15117-96-1	Contains (regardless of intentional or impurities)	chemical products
9193	Sodium metaarsenate	15120-17-9	Contains (regardless of intentional or impurities)	chemical products
9194	Pentamethylantimony	15120-50-0	Contains (regardless of intentional or impurities)	chemical products
9195	2-Butenoic acid, 4-oxo-4-phenyl-, ethyl ester, (2E)-	15121-89-8	Contains (regardless of intentional or impurities)	chemical products
9196	Prussite (Ag3AsS3)	15122-58-4	Contains (regardless of intentional or impurities)	chemical products
9197	Copper selenate	15123-89-0	Contains (regardless of intentional or impurities)	chemical products
9198	Pyrrhotite (Sb4S3S3)	15123-77-0	Contains (regardless of intentional or impurities)	chemical products
9199	Aluminum molybdenum oxide (Al2Mo3O12)	15123-80-1	Contains (regardless of intentional or impurities)	chemical products
9200	Thallium selenite	15123-92-9	Contains (regardless of intentional or impurities)	chemical products
9201	Dirubidium selenite	15123-97-4	Contains (regardless of intentional or impurities)	chemical products
9202	Silver vanadium oxide (Ag3VO4)	15124-04-6	Intentional addition / 1,000ppm	chemical products
9203	Boric acid (H3BO3), dipotassium salt	15124-13-7	Intentional addition / 1%	chemical products
9204	Nickel, tetrakis(triphenylphosphine)-, (T-4)-	15133-82-1	Contains (regardless of intentional or impurities)	chemical products
9205	Cobaltate(1-), [[N,N'-1,2-ethanedilybisN-(carboxymethyl)glycinato]](4-)-N,N',O',O',ON,ON]-, (OC-6-21)-	15138-66-0	Intentional addition / 1%	chemical products
9206	Cobalt disodium ethylenediaminetetraacetate	15137-09-4	Intentional addition / 1,000ppm	chemical products
9207	Cadmium 117	15139-70-5	Contains (regardless of intentional or impurities)	chemical products
9208	Phosphoric acid, tin(4+) salt	15142-98-0	Contains (regardless of intentional or impurities)	chemical products
9209	Neodymium tribromate	15162-92-2	Intentional addition / 1%	chemical products
9210	Praseodymium tribromate	15162-93-3	Intentional addition / 1%	chemical products
9211	Scandium tribromate	15162-94-4	Intentional addition / 1%	chemical products
9212	Yttrium tribromate	15162-95-5	Intentional addition / 1%	chemical products
9213	Benzenesulfonic acid, 2-dodecyl-, sodium salt	15163-46-9	Intentional addition / 1%	chemical products
9214	Heptanoic acid, 2,2,3,3,4,4,5,5,6,6,7,7,7-dodecafluoro-6-(trifluoromethyl)-	15166-06-0	Intentional addition / 1,000ppm	chemical products
9215	Copper(II) selenite dihydrate	15168-20-4	Contains (regardless of intentional or impurities)	chemical products
9216	Cuprate(2-), [[N,N'-1,2-ethanedilybisN-(carboxymethyl)glycinato]](4-)-N,N',O',O',ON,ON]-, dipotassium, (OC-6-21)-	15170-14-6	Intentional addition / 1,000ppm	chemical products
9217	Copper, [μ-(N,N'-1,2-ethanedilybisN-(carboxymethyl)glycinato)](4-)-N,O,ON,N',O',ON]-di-	15170-19-1	Intentional addition / 1,000ppm	chemical products
9218	Bis(DL-methioninato-N,O)copper	15170-74-8	Intentional addition / 1,000ppm	chemical products
9219	Cuprate(3-), [4-amino-5-hydroxy-6-[[2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-1,3-naphthalenedisulfonato(5-)-], trihydrogen	15188-78-0	Intentional addition / 1,000ppm	chemical products
9220	Tris(neptane-3,5-dionato-O,O')cobalt	15188-91-7	Intentional addition / 1,000ppm	chemical products
9221	1,4,5,6,7,8,8-Heptachloro-3a,4,7,7a-tetrahydro-4,7-methano-1H-indene	15189-24-9	Intentional addition / 6%	chemical products
9222	Aurate(1-), tetrachloro-, sodium, (SP-4-1)-	15189-51-2	Intentional addition	chemical products
9223	Molybdenum sodium oxide (Mo3Na2O10)	15190-32-6	Intentional addition / 1%	chemical products
9224	Dicopper pyrophosphate	15191-80-7	Intentional addition / 1,000ppm	chemical products
9225	Silicic acid (H4SiO4), beryllium salt (1:2)	15191-85-2	Contains (regardless of intentional or impurities)	chemical products
9226	Thiocyanic acid, copper(2+) salt	15192-76-4	Intentional addition / 1,000ppm	chemical products
9227	Arsenous acid, calcium salt (2:1)	15194-98-6	Contains (regardless of intentional or impurities)	chemical products
9228	Calcium arsonate	15195-00-3	Contains (regardless of intentional or impurities)	chemical products
9229	Strontium arsenite	15195-06-9	Contains (regardless of intentional or impurities)	chemical products
9230	Manganese fluoride (MnF4)	15195-58-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
9231	Nicotine, lactate	15187-02-1	Contains (regardless of intentional or impurities)	chemical products
9232	Aqueous ferric perchlorate	15201-61-3	Intentional addition / 1,000ppm	chemical products
9233	Cobalt, tris(3-bromo-2,4-pentanedionato-0,O')-, (OC-6-11)-	15218-44-7	Intentional addition / 1,000ppm	chemical products
9234	Diethyltin sulfide trimer	15220-82-3	Contains (regardless of intentional or impurities)	chemical products
9235	Copper bis(piperidine-1-carbodiathioate)	15225-85-1	Intentional addition / 1,000ppm	chemical products
9236	Dichlorobis(pyridine)platinum	15227-42-6	Contains (regardless of intentional or impurities)	chemical products
9238	Barium 126	15229-36-4	Contains (regardless of intentional or impurities)	chemical products
9239	Cobalt iodide (CoI2)	15238-00-3	Intentional addition / 100ppm	chemical products
9239	Copper(2+) salicylate	15240-24-1	Intentional addition / 1,000ppm	chemical products
9240	Dibromobis(tributylphosphine)nickel(II)	15242-92-9	Contains (regardless of intentional or impurities)	chemical products
9241	Chromium, tetrachloro- $\mu$ -hydroxy- $\mu$ -(octadecanoato-0,O')di-	15242-96-3	Intentional addition / 1,000ppm	chemical products
9242	Sulfuric acid, non(3+) salt (3:2), hydrate	15244-10-7	Intentional addition / 1%	chemical products
9243	Sulfuric acid, manganese(2+) salt (1:1), hydrate	15244-36-7	Contains (regardless of intentional or impurities)	chemical products
9244	Sulfuric acid, nickel(2+) salt (1:1), hydrate	15244-37-8	Contains (regardless of intentional or impurities)	chemical products
9245	Sulfuric acid, chromium(3+) salt (3:2), hydrate	15244-38-9	Intentional addition / 1,000ppm	chemical products
9246	Pentaamminecarbonatocobalt(III) nitrate	15244-74-3	Intentional addition / 1%	chemical products
9247	Lithium [2H4]tetrahydroborate(1-)	15246-28-3	Intentional addition / 1%	chemical products
9248	Oxalic acid, sodium salt	15248-76-7	Intentional addition / 1,000ppm	chemical products
9249	Dibutylbis(methacryloyloxy)stannane	15257-25-7	Contains (regardless of intentional or impurities)	chemical products
9250	Ferrichrome A	15258-80-7	Intentional addition / 1%	chemical products
9251	Platinat(1-), (1-acetyl-2-oxopropyl)chloro(2,4-pentanedionato-0,O')-, potassium, (SP-4-2)-	15258-91-0	Contains (regardless of intentional or impurities)	chemical products
9252	Cartap hydrochloride	15263-52-2	Contains (regardless of intentional or impurities)	chemical products
9253	Cartap	15263-53-3	Contains (regardless of intentional or impurities)	chemical products
9254	Dichlorobis(tributylphosphine)nickel(II)	15274-43-8	Contains (regardless of intentional or impurities)	chemical products
9255	Sodium tetrafluoroferrate(1-)	15274-99-4	Intentional addition / 1%	chemical products
9256	Cobaltate(3-), tris[ethanedioato(2-)-0,O']-, tripotassium, trihydrate, (OC-6-11)-	15275-08-8	Intentional addition / 1%	chemical products
9257	(OC-6-11)-Tetrapotassium hexachloroocadmate	15276-40-1	Intentional addition / 1,000ppm	chemical products
9258	Boron, [(2,2',2''-nitrioltris[ethanolato](3-N,O,O',O')-, (T-4)-	15277-97-1	Intentional addition / 1%	chemical products
9259	Platinat(2-), tetrabromo- dicesium, (SP-4-1)-	15278-82-7	Contains (regardless of intentional or impurities)	chemical products
9260	Platinat(2-), tetrabromo- dirubidium, (SP-4-1)-	15278-86-1	Contains (regardless of intentional or impurities)	chemical products
9261	Aurate(1-), bis(cyano-C)-, sodium	15280-09-8	Contains (regardless of intentional or impurities)	chemical products
9262	Cuprate(3-), tetrakis(cyano-C)-, trisodium, (T-4)-	15281-91-1	Intentional addition / 1,000ppm	chemical products
9263	Ammonium trifluorohydroxyborate(1-)	15283-48-4	Intentional addition / 1%	chemical products
9264	Borate(1-), tetrafluoro- iron(2+) (2:1)	15283-51-9	Contains (regardless of intentional or impurities)	chemical products
9265	Silicic acid (H4SiO4), sodium zirconium(4+) salt (3:4:2)	15292-27-0	Contains (regardless of intentional or impurities)	chemical products
9266	Sodium metaborate hydrate	15293-77-3	Intentional addition / 1%	chemical products
9267	Bezitramide	15301-48-1	Intentional addition	chemical products
9268	Tin(2+) phthalocyanine	15304-57-1	Intentional addition / 1,000ppm	chemical products
9269	Dipotassium aquapentachlorohydroate	15306-82-8	Contains (regardless of intentional or impurities)	chemical products
9270	Nickel, bis[bis(2-methylpropyl)carbamodithioato-S,S']-, (SP-4-1)-	15317-78-9	Contains (regardless of intentional or impurities)	chemical products
9271	Rhodium, carbonylchlorobis(triphenylphosphine)-, (SP-4-3)-	15318-33-9	Contains (regardless of intentional or impurities)	chemical products
9272	Barium perchlorate monohydrate	15318-52-2	Intentional addition	chemical products
9273	Disodium tetrakis(cyano-c)platinat	15321-27-4	Contains (regardless of intentional or impurities)	chemical products
9274	Dirubidium tetrakis(cyano-c)platinat	15321-31-0	Contains (regardless of intentional or impurities)	chemical products
9275	Iron, tri- $\mu$ -carbonylhexacarbonyl-, (Fe-Fe)	15321-51-4	Intentional addition / 1%	chemical products
9276	Benzotriazole-1-carbonitrile	15328-32-2	Intentional addition	chemical products
9277	Zincate(2-), tetrakis(cyano-C)-, disodium, (T-4)-	15333-24-1	Contains (regardless of intentional or impurities)	chemical products
9278	Rhodate(3-), hexachloro-, triammonium, (OC-6-11)-	15336-18-2	Contains (regardless of intentional or impurities)	chemical products
9279	Silver acetylacetonate	15336-58-0	Intentional addition / 1,000ppm	chemical products
9280	Diallyldibutylstannane	15336-98-8	Contains (regardless of intentional or impurities)	chemical products
9281	Cadmium-barium laurate	15337-60-7	Contains (regardless of intentional or impurities)	chemical products
9282	Dichlorobis[1,1'-thiobis(ethane)]platinum	15337-84-5	Contains (regardless of intentional or impurities)	chemical products
9283	Manganese dimethylidithiocarbamate	15339-36-3	Contains (regardless of intentional or impurities)	chemical products
9284	(T-4)-Barium tetrafluoroberyllate	15339-40-9	Contains (regardless of intentional or impurities)	chemical products
9285	Sulfuric acid, cesium chromium(3+) salt (2:1:1), dodecahydrate	15363-19-6	Intentional addition / 1,000ppm	chemical products
9286	(OC-6-11)-Hexamminechromium trinitrate	15363-28-7	Intentional addition / 1,000ppm	chemical products
9287	Vanadium, [(2,2',2''-nitrioltris[ethanolato](3-N,O,O',O')-oxo-	15364-25-7	Intentional addition / 1%	chemical products
9288	Manganese(II) perchlorate hexahydrate	15364-94-0	Contains (regardless of intentional or impurities)	chemical products
9289	3-Cyclopentene-1-acetonitrile, 2,2,3-trimethyl-	15373-31-6	Intentional addition	chemical products
9290	Disodium manganese ethylenediaminetetraacetate	15375-84-5	Contains (regardless of intentional or impurities)	chemical products
9291	Zincate(2-), [mu-[[ethanedioato(2-)-0,O',O'] bis[ethanedioato(2-)-0,O']di, dihydrogen, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	15375-89-0	Contains (regardless of intentional or impurities)	chemical products
9292	(OC-6-11)-Trithallium hexakis(cyano-C)cobaltate	15377-79-4	Intentional addition / 1%	chemical products
9293	Difluoro(3-oxo-N-phenylbutylamido)-O,O'boron	15387-98-1	Intentional addition / 1%	chemical products
9294	Iron(2+), tris(2,2'-bipyridine-N,N')-, (OC-6-11)-, diperchlorate	15388-48-4	Intentional addition / 1,000ppm	chemical products
9295	Iron(2+), tris(5-nitro-1,10-phenanthroline-N1,N10)-, diperchlorate	15389-73-8	Intentional addition / 1,000ppm	chemical products
9296	Bis(salicylidenedimino-3-propyl)methylammonocobalt(II)	15391-24-9	Intentional addition / 1%	chemical products
9297	Chloropentakis(methylamine)cobalt dichloride	15392-59-3	Intentional addition / 1,000ppm	chemical products
9298	Diamminebis(nitrito-N)platinum	15413-19-1	Contains (regardless of intentional or impurities)	chemical products
9299	Copper, diamminebis(nitrato-kappa O)-	15414-04-7	Intentional addition / 1,000ppm	chemical products
9300	Methylum, triphenyl-, pentachlorostannate(1-)	15414-98-9	Contains (regardless of intentional or impurities)	chemical products
9301	Nickelate(2-), [7,12-diethenyl-3,8,13,17-tetramethyl-21H,23H-porphine-2,18-dipropionato(4-)-kappa N21,kappa N22,kappa N23,kappa N24]-, hydrogen (1:2)	15415-30-2	Contains (regardless of intentional or impurities)	chemical products
9302	Chromium, bis(acetato-O)hydroxy-	15417-46-6	Intentional addition / 1,000ppm	chemical products
9303	Cuprate(4-), [mu-[[7,7'-(carbonyldiimino)bis(4-hydroxy-3-[(2-hydroxy-5-sulfofophenyl)azo]-2-naphthalenesulfonato](8-))]di-, tetrasodium	15418-16-3	Intentional addition / 1,000ppm	chemical products
9304	Selenium 73	15422-57-8	Contains (regardless of intentional or impurities)	chemical products
9305	Selenium 81	15422-58-9	Contains (regardless of intentional or impurities)	chemical products
9306	Arsenic 73	15422-59-0	Contains (regardless of intentional or impurities)	chemical products
9307	Yttrium 95	15422-71-6	Contains (regardless of intentional or impurities)	chemical products
9308	Yttrium 94	15422-72-7	Contains (regardless of intentional or impurities)	chemical products
9309	1-Heptene, 6-bromo-6-methyl-	15424-05-2	Intentional addition / 1,000ppm	chemical products
9310	Copper divalente	15432-57-2	Intentional addition / 1,000ppm	chemical products
9311	Antimonate (SbO31-), sodium	15432-85-6	Contains (regardless of intentional or impurities)	chemical products
9312	Borane, trifluoro-, hydrate	15433-40-6	Intentional addition / 1,000ppm	chemical products
9313	Iron(II) ion	15438-31-0	Intentional addition / 1%	chemical products
9314	Dichlorobis[1,1'-thiobis(ethane)]platinum	15442-57-6	Contains (regardless of intentional or impurities)	chemical products
9315	Copper, bis(1-phenyl-1,3-pentanedionato-0,O')-	15443-06-8	Intentional addition / 1,000ppm	chemical products
9316	Dichlorobis(ethylenediamine)rhodium chloride	15444-62-9	Contains (regardless of intentional or impurities)	chemical products
9317	[1,2-Bis(diphenylphosphino)ethane]tetracarbonylmolybdenum(0)	15444-66-3	Intentional addition / 1%	chemical products
9318	Platinum(2+), tetrakis(hydroxylamine-N)-, dihydroxide, (SP-4-1)-	15445-15-5	Contains (regardless of intentional or impurities)	chemical products
9319	Propylene-1,2-oxide, (R)-(+)-	15448-47-2	Intentional addition / 1,000ppm	chemical products
9320	Bis(5-oxo-L-prolinato-N1,O2)copper	15454-74-7	Intentional addition / 1,000ppm	chemical products
9321	Sulfurous acid, zinc salt (2:1)	15457-98-4	Contains (regardless of intentional or impurities)	chemical products
9322	Trindymite	15468-32-3	Contains (regardless of intentional or impurities)	chemical products
9323	Aluminium chloride	15477-33-5	Intentional addition / 1,000ppm	chemical products
9324	Bis(benzoylthio)diocystannane	15481-47-7	Contains (regardless of intentional or impurities)	chemical products
9325	Bis(benzoylthio)dibutylstannane	15481-48-8	Contains (regardless of intentional or impurities)	chemical products
9326	Toluene-2,6-diamine monohydrochloride	15481-68-2	Intentional addition / 2%	chemical products
9327	2,6-Toluenediamine dihydrochloride	15481-70-6	Intentional addition / 2%	chemical products
9328	Stibophen	15489-16-4	Contains (regardless of intentional or impurities)	chemical products
9329	Trisodium hexakis(nitrito-N)rhodate	15489-17-5	Contains (regardless of intentional or impurities)	chemical products
9330	Dilithium tetrachlorocuprate	15489-27-7	Intentional addition / 1,000ppm	chemical products
9331	Hexakis(thiourea)dicropper dichloride	15489-72-2	Intentional addition / 1,000ppm	chemical products
9332	Dihydrogen hydroxy[3,8,13,17-tetramethyl-7,12-divinyl-21H,23H-porphine-2,18-dipropionato(4-)-N21,N22,N23,N24]ferrate(2-)	15489-90-4	Intentional addition / 1%	chemical products
9333	Rhodium iodide (RhI3)	15492-38-3	Contains (regardless of intentional or impurities)	chemical products
9334	Tetrabutylammonium bis(4-methyl-1,2-benzenedithiolato)nickelate	15492-42-9	Contains (regardless of intentional or impurities)	chemical products
9335	Selenious acid, sodium salt	15498-87-0	Contains (regardless of intentional or impurities)	chemical products
9336	Beryllium citrate	15499-68-0	Contains (regardless of intentional or impurities)	chemical products
9337	Nitric acid, hafnium(4+) salt	15509-05-4	Intentional addition / 1%	chemical products
9338	Vanadium iodide (VI2)	15513-84-5	Intentional addition / 1,000ppm	chemical products
9339	Vanadium iodide (VI3)	15513-94-7	Intentional addition / 1,000ppm	chemical products
9340	Propanoic acid, 2,2-dimethyl-, cobalt(2+) salt	15520-31-7	Intentional addition / 1,000ppm	chemical products
9341	Nitric acid, cobalt(3+) salt	15520-84-0	Intentional addition / 1,000ppm	chemical products
9342	Nickel dimethylidithiocarbamate	15521-65-0	Contains (regardless of intentional or impurities)	chemical products
9343	Tetrabutylammonium tetraphenylborate	15522-59-5	Intentional addition / 1%	chemical products
9344	Tetramethylammonium tetraphenylborate	15525-13-0	Intentional addition / 1%	chemical products
9345	Tetraphenylphosphoniumtetraphenylborate	15525-15-2	Intentional addition / 1%	chemical products
9346	Iron(2+), tris(5-methyl-1,10-phenanthroline-N1,N10)-, diperchlorate	15526-61-1	Intentional addition / 1,000ppm	chemical products
9347	Sodium zirconium lactate	15529-67-6	Contains (regardless of intentional or impurities)	chemical products
9348	Dichlorobis(ethylenediamine)rhodium nitrate	15529-88-1	Contains (regardless of intentional or impurities)	chemical products
9349	Dipotassium tetrachloroferrate(2-)	15530-87-7	Intentional addition / 1%	chemical products
9350	1,3,2-Oxathiasannolan-5-one, 2,2-dioctyl-	15535-79-2	Contains (regardless of intentional or impurities)	chemical products
9351	N-(3-Chloro-4-methylphenyl)-N,N-dimethylurea	15545-48-9	Contains (regardless of intentional or impurities)	chemical products
9352	2,2'-Azodi-(2,4-dimethyl-4-methoxyvaleronitrile)	15545-97-8	Contains (regardless of intentional or impurities)	chemical products
9353	Di-n-butyltin bis(methyl maleate)	15546-11-9	Contains (regardless of intentional or impurities)	chemical products
9354	Bis(2-ethylhexyloxy)maleoxy) dibutylstannane	15546-12-0	Contains (regardless of intentional or impurities)	chemical products
9355	Di-n-butyltin di(monobutyl)maleate	15546-16-4	Contains (regardless of intentional or impurities)	chemical products
9356	Diammonium yttrium pentanitrate	15552-06-4	Intentional addition / 1%	chemical products
9357	Tungstate (WO66-), barium calcium (1:2:1), (OC-6-11)-	15552-14-4	Intentional addition / 1,000ppm	chemical products
9358	Tris(pentane-2,4-dionato-0,O')yttrium	15554-47-9	Intentional addition / 1%	chemical products
9359	Iron(2+), tris(4,7-diphenyl-1,10-phenanthroline-N1,N10)-, diperchlorate	15555-71-2	Intentional addition / 1,000ppm	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
9360	[o-[5-[2-Hydroxy-5-[(m-sulphamoylphenyl)sulphamoyl]phenyl]-3-phenyl-1-formazano]benzoato(2-)]copper	15559-47-4	Intentional addition / 1,000ppm	chemical products
9361	Nicotine, monogallate	15586-33-3	Contains (regardless of intentional or impurities)	chemical products
9362	Nicotine, oxalate (1:2)	15566-45-7	Contains (regardless of intentional or impurities)	chemical products
9363	Isobutyl (Z,Z)-2-methyl-10,10-dioctyl-5,8,12-trioxo-4,9,11-trioxo-10-stannapentadeca-6,13-dien-15-olate	15571-59-2	Contains (regardless of intentional or impurities)	chemical products
9364	4,4'-((diocetylstannylene)bis(oxy))bis[4-oxoisocrotonic]acid	15571-60-5	Contains (regardless of intentional or impurities)	chemical products
9365	Telluric acid (H <sub>2</sub> TeO <sub>4</sub> ), dipotassium salt	15571-61-2	Contains (regardless of intentional or impurities)	chemical products
9366	Thallium selenide (Tl <sub>2</sub> Se)	15572-25-5	Contains (regardless of intentional or impurities)	chemical products
9367	Arsenic 76	15575-20-9	Contains (regardless of intentional or impurities)	chemical products
9368	Zincocyl sulfate	15578-19-5	Contains (regardless of intentional or impurities)	chemical products
9369	Diphosphoric acid, tin(2+) salt (1:2)	15578-26-4	Contains (regardless of intentional or impurities)	chemical products
9370	Tritin bis(orthophosphate)	15578-32-2	Contains (regardless of intentional or impurities)	chemical products
9371	Ethanol, 2-mercapto-, O,O'-triester with boric acid (H <sub>3</sub> B <sub>3</sub> O <sub>3</sub> )	15582-80-6	Intentional addition / 1%	chemical products
9372	Chromic acid (H <sub>2</sub> Cr <sub>2</sub> O <sub>7</sub> ), nickel(2+) salt (1:1)	15586-38-6	Contains (regardless of intentional or impurities)	chemical products
9373	Selenious acid, dicesium salt	15586-47-7	Contains (regardless of intentional or impurities)	chemical products
9374	Hydroxylamine, perchlorate (salt)	15588-82-2	Intentional addition / 1,000ppm	chemical products
9375	Copper chloride (CuCl <sub>2</sub> )	15593-15-4	Intentional addition / 1,000ppm	chemical products
9376	Lithium molybdenum oxide (Li <sub>2</sub> Mo <sub>2</sub> O <sub>7</sub> )	15593-38-1	Intentional addition / 1%	chemical products
9377	Selenious acid, dilithium salt	15593-51-8	Contains (regardless of intentional or impurities)	chemical products
9378	Selenic acid, dilithium salt	15593-52-9	Contains (regardless of intentional or impurities)	chemical products
9379	Trilithium vanadium tetraoxide	15593-56-3	Intentional addition / 1%	chemical products
9380	Magnesium selenite	15593-61-0	Contains (regardless of intentional or impurities)	chemical products
9381	Antimonate (SbO <sub>4</sub> <sup>3-</sup> ), trisodium, (T-4)-	15593-75-6	Contains (regardless of intentional or impurities)	chemical products
9382	Thorium 229	15594-54-4	Contains (regardless of intentional or impurities)	chemical products
9383	Boron, (cyclohexanamine)trifluoro-, (T-4)-	15595-91-2	Intentional addition / 1%	chemical products
9384	Nickel chloride (NiCl <sub>2</sub> )	15596-82-4	Contains (regardless of intentional or impurities)	chemical products
9385	Thallium(3+) perchlorate	15596-83-5	Contains (regardless of intentional or impurities)	chemical products
9386	Trimethyltin isothiocyanate	15597-43-0	Contains (regardless of intentional or impurities)	chemical products
9387	Chromium chloride (CrCl <sub>3</sub> ), (T-4)-	15597-88-3	Intentional addition / 1,000ppm	chemical products
9388	Pyridine perchlorate	15598-34-2	Intentional addition / 1,000ppm	chemical products
9389	Iron iodide (FeI <sub>3</sub> )	15600-49-4	Intentional addition / 1%	chemical products
9390	Barium fluorophosphate	15600-53-0	Contains (regardless of intentional or impurities)	chemical products
9391	Diphosphoric acid, cadmium salt (1:2)	15600-62-1	Contains (regardless of intentional or impurities)	chemical products
9392	Antimony iron oxide (SbFeO <sub>4</sub> )	15600-71-2	Contains (regardless of intentional or impurities)	chemical products
9393	Cobalt bromide (CoBr <sub>3</sub> )	15605-72-8	Intentional addition / 1%	chemical products
9394	Platinum, bis[1,2-diphenyl-1,2-ethenedithiolato(2-)-S,S']-, (SP-4-1)-	15607-55-3	Contains (regardless of intentional or impurities)	chemical products
9395	Nickel bromide (NiBr <sub>3</sub> )	15608-15-8	Contains (regardless of intentional or impurities)	chemical products
9396	Rhodium bromide (RhBr <sub>3</sub> )	15608-29-4	Contains (regardless of intentional or impurities)	chemical products
9397	Phosphoric acid, ammonium manganese(2+) salt (1:1:1)	15609-81-1	Contains (regardless of intentional or impurities)	chemical products
9398	Cuprate(2-), tetrachloro-, diammonium	15610-76-1	Intentional addition / 1,000ppm	chemical products
9399	Disodium heptadecaacetatetetracacetatetramolybdate(2-)	15611-13-9	Contains (regardless of intentional or impurities)	chemical products
9400	(Dioxo)gen/bis(triphenylphosphine)platinum	15614-67-2	Contains (regardless of intentional or impurities)	chemical products
9401	Bis(2-aminobenzeneselenolato-N,S)zinc	15615-72-2	Contains (regardless of intentional or impurities)	chemical products
9402	Bis(N-hydroxy-N-nitrosocyclohexylamino-O,O')copper	15627-09-5	Intentional addition / 1,000ppm	chemical products
9403	Nickel, dichloro,1,1'-(1,3-propanediylo)bis[1,1-diphenylphosphine-kappa P]--	15629-92-2	Contains (regardless of intentional or impurities)	chemical products
9404	Cadmium, bis(2-phenylhydrazinecarbodithioato-N <sub>2</sub> S,)-, (T-4)-	15630-39-4	Contains (regardless of intentional or impurities)	chemical products
9405	Ferrichrome	15630-64-5	Intentional addition / 1%	chemical products
9406	Yttrium(III) tris(2,2,6,6-tetramethyl-3,5-heptanedionate)	15632-39-0	Intentional addition / 1,000ppm	chemical products
9407	(T-4)-Dithallium tetracyanomercurate	15634-23-8	Intentional addition / 1,000ppm	chemical products
9408	Thallium bis(cyano-C)argentate	15634-29-4	Intentional addition / 1,000ppm	chemical products
9409	Sodium tris(1,2-naphthoquinone 1-oximate-N <sub>1</sub> O <sub>2</sub> )ferrate(1-)	15635-53-7	Intentional addition / 1%	chemical products
9410	Boron, trihydro(4-methylmorpholine-kappa N <sub>4</sub> )-, (T-4)-	15638-18-5	Intentional addition / 1%	chemical products
9411	Platinum(2+), tetraammine-, dihydroxide, (SP-4-1)-	15651-37-3	Contains (regardless of intentional or impurities)	chemical products
9412	Decaferitin	15652-38-7	Contains (regardless of intentional or impurities)	chemical products
9413	Bis(diethyldithiocarbamato-S,S')iron	15656-03-8	Intentional addition / 1%	chemical products
9414	1,2-Benzenedicarboxylic acid, barium salt (1:1)	15656-86-7	Contains (regardless of intentional or impurities)	chemical products
9415	Chromium, tetrachloro-mu-hydroxy[mu-(tetradecanoato-O,O')]di-	15659-56-0	Intentional addition / 1,000ppm	chemical products
9416	Cisplatin	15663-27-1	Contains (regardless of intentional or impurities)	chemical products
9417	Stannane, butyltris(dodecylthio)-	15666-28-1	Contains (regardless of intentional or impurities)	chemical products
9418	Diastannathiane, dibutylthioxo-	15666-29-2	Contains (regardless of intentional or impurities)	chemical products
9419	Octyl cyanoacetate	15666-97-4	Intentional addition	chemical products
9420	Zirconium, [carbonato(2-)-O,O']oxo-	15667-84-2	Contains (regardless of intentional or impurities)	chemical products
9421	Tetraaluminum tris(hexakis(cyano-C)ferrate(4-))	15669-30-4	Intentional addition / 1%	chemical products
9422	Platinum, di-mu-chlorodichlorobis(tributylphosphine)di-	15670-38-9	Contains (regardless of intentional or impurities)	chemical products
9423	(T-4)-Dithallium tetrakis(cyano-C)zincate	15671-21-3	Intentional addition / 1,000ppm	chemical products
9424	Sulphitocobalamin	15671-27-9	Intentional addition / 1%	chemical products
9425	D-Ribose, 5-(dihydrogen phosphate), barium salt (1:1)	15673-79-7	Contains (regardless of intentional or impurities)	chemical products
9426	Borate(1-), bis[3-chloro-2-hydroxy-5-nonylbenzenemethanolato(2-)-O,O']-, sodium, (T-4)-	15675-97-5	Intentional addition / 1%	chemical products
9427	Benzoic acid, p-nitro-, compound with nicotine (3:1)	15677-87-9	Contains (regardless of intentional or impurities)	chemical products
9428	Phenanthridine, 6-chloro-	15679-03-5	Contains (regardless of intentional or impurities)	chemical products
9429	Copper, [1-[[[2-hydroxyphenyl]imino]methyl]-2-naphthalenolato(2-)-N,O,O']-	15680-42-9	Intentional addition / 1,000ppm	chemical products
9430	Sodium [2H <sub>4</sub> ]tetrahydroborate(1-)	15681-89-7	Intentional addition / 1%	chemical products
9431	Cadmiate(2-), tetrakis(cyano-C)-, disodium, (T-4)-	15682-87-8	Contains (regardless of intentional or impurities)	chemical products
9432	Disodium tetra(cyano-C)mercurate(2-)	15682-88-9	Contains (regardless of intentional or impurities)	chemical products
9433	Cobalt(II) tetrafluoroborate hexahydrate	15684-35-2	Intentional addition / 1%	chemical products
9434	Bis(diethyldithiocarbamato-S,S')manganese	15685-17-3	Contains (regardless of intentional or impurities)	chemical products
9435	Zinc(2+), tetraammine-, (T-4)-, bis(tetrafluoroborate(1-))	15689-07-3	Contains (regardless of intentional or impurities)	chemical products
9436	Molybdenum 90	15690-77-4	Contains (regardless of intentional or impurities)	chemical products
9437	Formic acid, nickel(II) salt, dihydrate	15694-70-9	Contains (regardless of intentional or impurities)	chemical products
9438	Sulfuric acid, ammonium nickel(2+) salt (2:2:1)	15699-18-0	Contains (regardless of intentional or impurities)	chemical products
9439	Sulfuric acid, nickel(2+) rubidium salt (2:1:2)	15699-20-4	Contains (regardless of intentional or impurities)	chemical products
9440	Manganic acid (H <sub>2</sub> MnO <sub>4</sub> ), disodium salt	15702-33-7	Contains (regardless of intentional or impurities)	chemical products
9441	Selenious acid, manganese(2+) salt (1:1)	15702-34-8	Contains (regardless of intentional or impurities)	chemical products
9442	Molybdenum praseodymium oxide (Mo <sub>3</sub> Pr <sub>2</sub> O <sub>12</sub> )	15702-41-7	Intentional addition / 1%	chemical products
9443	Strontium tetracyanoplatinate	15705-70-1	Contains (regardless of intentional or impurities)	chemical products
9444	Rhodium 107	15706-50-0	Contains (regardless of intentional or impurities)	chemical products
9445	Cadmiate(2-), [[N,N'-1,2-ethanediylo]bis[N-(carboxymethyl)glycinato]](4-)-N,N',O,O',ON,ON]-, dipotassium, (OC-6-21)-	15708-29-9	Contains (regardless of intentional or impurities)	chemical products
9446	Monosodium ferric EDTA	15708-41-5	Intentional addition / 1%	chemical products
9447	Disodium nickel EDTA	15708-55-1	Contains (regardless of intentional or impurities)	chemical products
9448	Nitric acid, manganese(2+) salt, hydrate	15710-66-4	Contains (regardless of intentional or impurities)	chemical products
9449	Iodine 123	15715-08-9	Contains (regardless of intentional or impurities)	chemical products
9450	Heptanoic acid, 2,2,3,3,4,4,5,5,6,7,7,7-dodecafluoro-6-(trifluoromethyl)-, aluminum salt (3:1)	15715-47-6	Intentional addition / 100ppm	chemical products
9451	Ethylene diamine, diperchlorate	15718-71-5	Intentional addition / 1,000ppm	chemical products
9452	Dibutyltin diisothiocyanate	15719-34-3	Contains (regardless of intentional or impurities)	chemical products
9453	Formic acid, cobalt salt	15731-88-1	Intentional addition / 1,000ppm	chemical products
9454	Phenol, 4-chloro-3-methyl-, sodium salt	15733-22-9	Intentional addition / 1,000ppm	chemical products
9455	Disodium [7-amino-4-hydroxy-3-[[[2-hydroxy-5-sulphophenyl]azo]naphthalene-2-sulphonato(4-)]cuprate(2-)]	15738-74-6	Intentional addition / 1,000ppm	chemical products
9456	Copper, [3,7,11,15-tetramethyl-2-hexadecyl 9-ethenyl-14-ethyl-21-(methoxycarbonyl)-4,8,13,18-tetramethyl-20-oxo-3-phenylpropanoato(2-)-N <sub>23</sub> ,N <sub>24</sub> ,N <sub>25</sub> ,N <sub>26</sub> ]-, [SP-4-2-[S-3.alpha.(2E,7S*,11S*)4.beta.21.beta.]]-	15739-09-0	Intentional addition / 1,000ppm	chemical products
9457	Heptanoic acid, 2,2,3,3,4,4,5,5,6,7,7,7-dodecafluoro-6-(trifluoromethyl)-, chromium salt (1:2)	15739-82-9	Intentional addition / 100ppm	chemical products
9458	Iron(2+), tris(4,4'-dimethyl-2,2'-bipyridine-N,N')-, (OC-6-11)-, diperchlorate	15740-92-8	Intentional addition / 1,000ppm	chemical products
9459	Barium 128	15741-25-0	Contains (regardless of intentional or impurities)	chemical products
9460	Barium 141	15741-29-4	Contains (regardless of intentional or impurities)	chemical products
9461	Cadmium acrylate	15743-19-8	Contains (regardless of intentional or impurities)	chemical products
9462	2-Propanoic acid, aluminum salt	15743-20-1	Intentional addition / 1,000ppm	chemical products
9463	Zirconium 86	15743-56-3	Contains (regardless of intentional or impurities)	chemical products
9464	Hafnium 175	15750-13-7	Contains (regardless of intentional or impurities)	chemical products
9465	Nickel(2+), hexakis(1H-imidazole-N <sub>3</sub> )-, dichloride, (OC-6-11)-	15751-00-5	Contains (regardless of intentional or impurities)	chemical products
9466	Yttrium 92	15751-59-4	Contains (regardless of intentional or impurities)	chemical products
9467	Zirconium 93	15751-77-6	Contains (regardless of intentional or impurities)	chemical products
9468	Antimony 117	15755-18-7	Contains (regardless of intentional or impurities)	chemical products
9469	Antimony 116	15755-27-8	Contains (regardless of intentional or impurities)	chemical products
9470	Arsenic 72	15755-33-6	Contains (regardless of intentional or impurities)	chemical products
9471	Arsenic 78	15755-35-8	Contains (regardless of intentional or impurities)	chemical products
9472	Antimony 131	15756-29-3	Contains (regardless of intentional or impurities)	chemical products
9473	Antimony 126	15756-32-8	Contains (regardless of intentional or impurities)	chemical products
9474	Antimony 128	15756-34-0	Contains (regardless of intentional or impurities)	chemical products
9475	Antimony 130	15756-35-1	Contains (regardless of intentional or impurities)	chemical products
9476	Hafnium 173	15757-23-0	Contains (regardless of intentional or impurities)	chemical products
9477	Selenium 79	15758-45-9	Contains (regardless of intentional or impurities)	chemical products
9478	Rhodium 99	15765-79-4	Contains (regardless of intentional or impurities)	chemical products
9479	Rhodium 100	15765-80-7	Contains (regardless of intentional or impurities)	chemical products
9480	Rhodium 102	15765-82-9	Contains (regardless of intentional or impurities)	chemical products
9481	Ethanedioic acid, manganese(2+) salt	15771-41-2	Intentional addition / 1%	chemical products
9482	Iron acrylate	15773-23-6	Intentional addition / 1%	chemical products
9483	1-Propananilinium, N,N,N-tripropyl-, perchlorate	15780-02-6	Intentional addition / 1,000ppm	chemical products
9484	Nickel uranium oxide (NiU <sub>3</sub> O <sub>10</sub> )	15780-33-3	Contains (regardless of intentional or impurities)	chemical products
9485	Benzenesulfonic acid, 4-[[[2-hydroxy-1-naphthalenyl]azo]-], barium salt (2:1)	15782-04-4	Contains (regardless of intentional or impurities)	chemical products
9486	Benzoic acid, 2-[[[2-hydroxy-3,6-disulfo-1-naphthalenyl]azo]-], barium salt (2:3)	15782-06-6	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
9487	2,7,9,11-Tetraoxa-8,10-distannapentadeca-4,13-dien-15-oiic acid, 8,8,10,10-tetrabutyl-3,6,12-trioxo-, methyl ester, (Z,Z)-	15785-44-1	Intentional addition / 1,000ppm	chemical products
9488	(Z)-2-Butenal	15798-64-8	Intentional addition / 1,000ppm	chemical products
9489	1,3-Benzenediol, 2,4,6-trinitro-, barium salt (1:1)	15805-42-2	Contains (regardless of intentional or impurities)	chemical products
9490	Tris(ethyl acetoacetato-O1,O3)iron	15819-11-1	Intentional addition / 1%	chemical products
9491	Hydrazine, phosphate (1:1)	15823-35-5	Contains (regardless of intentional or impurities)	chemical products
9492	Sulfuric acid, hafnium(4+) salt (2:1)	15823-43-5	Intentional addition / 1%	chemical products
9493	Mercury oxide (Hg2O)	15829-53-5	Contains (regardless of intentional or impurities)	chemical products
9494	Hafnium 183	15832-40-3	Contains (regardless of intentional or impurities)	chemical products
9495	Nickel formate	15832-40-4	Contains (regardless of intentional or impurities)	chemical products
9496	Thallium acetate	15843-14-8	Contains (regardless of intentional or impurities)	chemical products
9497	Iron oxalate	15843-42-2	Intentional addition / 1,000ppm	chemical products
9498	Ethanedioic acid, silver salt	15843-43-3	Intentional addition	chemical products
9499	Bis(2-hydroxy-4-(octyloxy)benzophenonato)nickel	15843-91-1	Contains (regardless of intentional or impurities)	chemical products
9500	Zirconium stearate	15844-92-5	Contains (regardless of intentional or impurities)	chemical products
9501	Telluric acid (H2TeO3), strontium salt (1:1)	15851-40-8	Contains (regardless of intentional or impurities)	chemical products
9502	Telluric acid (H2TeO3), cadmium salt (1:1)	15851-44-2	Contains (regardless of intentional or impurities)	chemical products
9503	Telluric acid (H2TeO3), manganese(2+) salt (1:1)	15851-49-7	Contains (regardless of intentional or impurities)	chemical products
9504	Telluric acid (H2TeO3), nickel(2+) salt (1:1)	15851-52-2	Contains (regardless of intentional or impurities)	chemical products
9505	Telluric acid (H2TeO4), dilithium salt	15851-53-3	Contains (regardless of intentional or impurities)	chemical products
9506	Telluric acid (H2TeO4), copper(2+) salt (1:1)	15852-05-8	Contains (regardless of intentional or impurities)	chemical products
9507	Telluric acid (H2TeO4), magnesium salt (1:1)	15852-08-1	Contains (regardless of intentional or impurities)	chemical products
9508	Telluric acid (H2TeO4), calcium salt (1:1)	15852-09-2	Contains (regardless of intentional or impurities)	chemical products
9509	Telluric acid (H2TeO4), strontium salt (1:1)	15852-10-5	Contains (regardless of intentional or impurities)	chemical products
9510	Telluric acid (H2TeO4), cadmium salt (1:1)	15852-14-9	Contains (regardless of intentional or impurities)	chemical products
9511	Telluric acid (H2TeO4), nickel(2+) salt (1:1)	15852-21-8	Contains (regardless of intentional or impurities)	chemical products
9512	Stannane, dibutylbis(3-carboxyacryloyloxy)-, dipropyl ester, (Z,Z)-	15853-77-7	Contains (regardless of intentional or impurities)	chemical products
9513	4-Methoxy-3-nitrophenyl	15854-73-6	Intentional addition / 1%	chemical products
9514	Selenious acid, sodium salt (4:1)	15855-80-8	Contains (regardless of intentional or impurities)	chemical products
9515	Indole-5-carbonitrile	15861-24-2	Intentional addition	chemical products
9516	1-(Hexylthio)-4-nitrobenzene	15863-36-2	Intentional addition / 1%	chemical products
9517	Heptane, 3-ethyl-	15869-80-4	Intentional addition / 1,000ppm	chemical products
9518	Phosphorodithioic acid, O,O-dipropyl ester, antimony(3+) salt	15874-48-3	Contains (regardless of intentional or impurities)	chemical products
9519	Phosphorodithioic acid, O,O-bis(2-methylpropyl) ester, antimony(3+) salt	15874-49-4	Contains (regardless of intentional or impurities)	chemical products
9520	Antimony tris(O,O-dipentyl) tris(dithiophosphate)	15874-50-7	Contains (regardless of intentional or impurities)	chemical products
9521	Phosphorodithioic acid, O,O-dihexyl ester, antimony(3+) salt	15874-51-8	Contains (regardless of intentional or impurities)	chemical products
9522	Phosphorodithioic acid, O,O-bis(2-ethylhexyl) ester, antimony(3+) salt	15874-52-9	Contains (regardless of intentional or impurities)	chemical products
9523	Boron trifluoride	15875-25-9	Contains (regardless of intentional or impurities)	chemical products
9524	1,1,3,3-Tetrabutyl-1,3-bis(1-oxododecyl)distannathiane	15880-66-7	Contains (regardless of intentional or impurities)	chemical products
9525	Telluric acid (H2TeO3), dirubidium salt	15885-40-2	Contains (regardless of intentional or impurities)	chemical products
9526	Magnesium tellurium trioxide	15885-42-4	Contains (regardless of intentional or impurities)	chemical products
9527	Telluric acid (H2TeO4), dirubidium salt	15885-43-5	Contains (regardless of intentional or impurities)	chemical products
9528	Antimony, tris(dipentylcarbamodithioato-S,S)-, (OC-6-11)-	15890-25-2	Contains (regardless of intentional or impurities)	chemical products
9529	Hexane, 1-bromo-5,5-dimethyl-	15898-91-6	Intentional addition / 1,000ppm	chemical products
9530	Telluric acid (H2TeO3), dicesium salt	15899-92-0	Contains (regardless of intentional or impurities)	chemical products
9531	Sulfuric acid, nickel salt	15905-81-4	Contains (regardless of intentional or impurities)	chemical products
9532	Nitric acid, uranium salt	15905-86-9	Contains (regardless of intentional or impurities)	chemical products
9533	Formic acid, copper salt	15907-03-6	Intentional addition / 1,000ppm	chemical products
9534	Stearic acid, chromium salt	15907-14-9	Intentional addition / 1,000ppm	chemical products
9535	Strychnine, D-, alpha-acetamido-6-carboxy-2-oxo-2H-pyran-3-propionate (1:1)	15912-16-0	Contains (regardless of intentional or impurities)	chemical products
9536	Diboron trimanganese(2+) hexaoxide	15915-03-4	Contains (regardless of intentional or impurities)	chemical products
9537	N-(4-Methylpentan-2-yl)aniline	15919-49-0	Intentional addition	chemical products
9538	Zinc chromate hydroxide	15930-94-6	Intentional addition / 1,000ppm	chemical products
9539	Tetrakis(mu-(acetato-O,O'))dirhodium	15956-28-2	Contains (regardless of intentional or impurities)	chemical products
9540	2-Ethylhexanoic acid, manganese salt	15956-58-8	Contains (regardless of intentional or impurities)	chemical products
9541	3-Ethyl-3-(2,3-epoxypropoxymethyl)oxethane	15957-34-3	Intentional addition / 1%	chemical products
9542	Alachlor	15972-80-8	Contains (regardless of intentional or impurities)	chemical products
9543	Bis(diethylthiocarbamato-S,S')cobalt	15974-34-2	Intentional addition / 1,000ppm	chemical products
9544	Copper, [1-chlorophthalocyaninato(2-)]-	15975-60-7	Intentional addition / 1,000ppm	chemical products
9545	(OC-8-22)-Tetraamminebis(nitrito-N)cobalt(1+) chloride	15977-81-8	Intentional addition / 1%	chemical products
9546	Platinum, diamminediodo- (SP-4-2)-	15978-93-5	Contains (regardless of intentional or impurities)	chemical products
9547	Antimony, tris[bis(2-ethylhexyl)carbamodithioato-S,S]-, (OC-6-11)-	15991-76-1	Contains (regardless of intentional or impurities)	chemical products
9548	1-Benzopyrylium, 5,6,7,8-tetrahydro-2,4-diphenyl-, perchlorate	15997-44-1	Intentional addition / 1,000ppm	chemical products
9549	2-Methoxy-1-naphthionitrile	16000-39-8	Intentional addition	chemical products
9550	1-Bromomethyl-4-iodobenzene	16004-15-2	Contains (regardless of intentional or impurities)	chemical products
9551	Ferrate(2-), chloro[7,12-diethenyl-3,8,13,17-tetramethyl-21H,23H-porphine-2,18-dipropanoato(4-)-N21,N22,N23,N24]-, dihydrogen, (SP-5-13)-	16009-13-5	Intentional addition / 1%	chemical products
9552	Tin, bis(2,4-pentanedionato-O,O)-, (T-4)-	16009-86-2	Contains (regardless of intentional or impurities)	chemical products
9553	2,6-Dichloro-3-nitropyridine	16013-85-7	Intentional addition / 1%	chemical products
9554	Silane, iodotrimethyl-	16029-98-4	Intentional addition / 1,000ppm	chemical products
9555	Strychnine hypophosphite	16036-87-6	Contains (regardless of intentional or impurities)	chemical products
9556	Chromate(1-), chlorotrioxo-, potassium, (T-4)-	16037-50-6	Contains (regardless of intentional or impurities)	chemical products
9557	Trisodium [2-(4,6-dichloro-1,3,5-triazin-2-yl)amino]-5-hydroxy-6-[[2-hydroxy-5-sulphophenyl]azo]naphthalene-1,7-disulphonato(5-)]cuprate(3-)	16038-15-6	Intentional addition / 1,000ppm	chemical products
9558	Copper dilactate	16039-52-4	Intentional addition / 1,000ppm	chemical products
9559	Cobalt dilactate	16039-54-6	Intentional addition / 1,000ppm	chemical products
9560	Cadmium dilactate	16039-55-7	Contains (regardless of intentional or impurities)	chemical products
9561	Manganese dilactate	16039-56-8	Contains (regardless of intentional or impurities)	chemical products
9562	Nickel dilactate	16039-61-5	Contains (regardless of intentional or impurities)	chemical products
9563	Antimonate(2-), bis(mu-, [2,3-di(hydroxy-kappa,O)butanedioato(4-)-kappa,O1:kappa,O4]di-, dipotassium, trihydrate, stereoisomer	16039-64-8	Intentional addition / 1,000ppm	chemical products
9564	Copper, [2,9,16,23-tetrachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-1)-	16040-69-0	Intentional addition / 1,000ppm	chemical products
9565	Copper disalicylate	16048-96-7	Intentional addition / 1,000ppm	chemical products
9566	Cadmium vanadium oxide (CdV2O6)	16056-72-7	Contains (regardless of intentional or impurities)	chemical products
9567	Chromium ion (3+)	16065-83-1	Contains (regardless of intentional or impurities)	chemical products
9568	Cuprate(3-), [2-(4,6-dichloro-1,3,5-triazin-2-yl)amino]-5-hydroxy-6-[[2-hydroxy-5-sulphophenyl]azo]-1,7-naphthalenedisulfonato(5-)]-, trihydrogen	16071-80-0	Intentional addition / 1,000ppm	chemical products
9569	C.I. Direct Brown 95	16071-86-6	Contains (regardless of intentional or impurities)	chemical products
9570	Zinc O,O'-dimethyl bis(dithiocarbonate)	16079-37-1	Intentional addition	chemical products
9571	Nickel(2+) trifluoroacetate	16083-14-0	Contains (regardless of intentional or impurities)	chemical products
9572	4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14,15,15,16,17,17-octacosafuoro-2-hydroxy-16-(trifluoromethyl)heptadecyl acrylate	16083-78-6	Intentional addition / 100ppm	chemical products
9573	4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14,15,15-tetracosafuoro-2-hydroxy-14-(trifluoromethyl)pentadecyl acrylate	16083-87-7	Intentional addition / 100ppm	chemical products
9574	(S)-1,2-Epoxypropane	16088-62-3	Intentional addition / 1,000ppm	chemical products
9575	Benzenesulfonic acid, 2,2'-(1,2-ethenediyl)bis[5-[4-(4-morpholinyl)-6-(phenylamino)-1,3,5-triazin-2-yl]amino]-, disodium salt	16090-02-1	Intentional addition / 1%	chemical products
9576	Diocetyl tin maleate	16091-18-2	Contains (regardless of intentional or impurities)	chemical products
9577	[N,N'-1,2-ethanediy]bis[N-(carboxymethyl)glycinate(4-)-N,N',O',O'ON,ON]-, (OC-6-21)-	16091-77-3	Contains (regardless of intentional or impurities)	chemical products
9578	Bis(trifluoro-2,4-pentanedionato)cobalt(II)	16092-38-9	Intentional addition / 1%	chemical products
9579	Nitric acid, zirconium salt	16092-48-1	Contains (regardless of intentional or impurities)	chemical products
9580	2,2'-(1-Methylethylene)bis(oxyethylene)bisoxirane	16096-30-3	Contains (regardless of intentional or impurities)	chemical products
9581	Benzenamine, 4-(hexylthio)-	16098-23-0	Intentional addition / 1%	chemical products
9582	5-oxo-L-proline, cadmium salt	16105-06-9	Contains (regardless of intentional or impurities)	chemical products
9583	Iodobis(triphenylphosphino)copper	16109-82-3	Intentional addition / 1,000ppm	chemical products
9584	Carbetamide	16118-49-3	Contains (regardless of intentional or impurities)	chemical products
9585	Ammonium nickel chloride, hexahydrate	16122-03-5	Contains (regardless of intentional or impurities)	chemical products
9586	(Z)-3,6-Dioxo-1,1,1,8,8,8-hexaphenyl-2,7-dioxo-1,8-distannaoct-4-ene	16122-27-3	Contains (regardless of intentional or impurities)	chemical products
9587	Arsenotriselenic acid, trithallium(1+) salt	16142-89-5	Contains (regardless of intentional or impurities)	chemical products
9588	Cuprate(4-), [mu-, [[6,6'-[[3,3'-di(hydroxy-kappa,O)]](1,1'-biphenyl)-4,4'-diyl]bis(azo-kappa,N1)]bis[4-amino-5-(hydroxy-kappa,O)-1,3-naphthalenedisulfonato]](8-)]di-, tetrasodium	16143-79-6	Intentional addition / 1,000ppm	chemical products
9589	Ferrate(1-), tris[[1,2-naphthalenedione-kappa,O2]-1-oximate-kappa,O]-, sodium	16143-80-9	Intentional addition / 1%	chemical products
9590	4-Isopropylphenylboronic acid	16152-51-5	Intentional addition / 1%	chemical products
9591	Benzoyl chloride, 4-formyl-	16173-52-7	Contains (regardless of intentional or impurities)	chemical products
9592	(2,6-Dimethylphenyl)acetoneitrile	16213-85-7	Contains (regardless of intentional or impurities)	chemical products
9593	Tris(2,4,4-trimethylpentyl)aluminium	16216-31-2	Intentional addition / 1,000ppm	chemical products
9594	Ethylidene norbornene	16219-75-3	Intentional addition / 1%	chemical products
9595	Thallium(III) sulfate	16222-66-5	Contains (regardless of intentional or impurities)	chemical products
9596	1,4-Benzenediamine, sulfate (1:1)	16245-77-5	Contains (regardless of intentional or impurities)	chemical products
9597	Ammonium molybdenum oxide ((NH4)2Mo3O10)	16289-82-0	Intentional addition / 1%	chemical products
9598	2,3,5,6-Tetrafluoro-4-pyridinecarbonitrile	16297-07-7	Intentional addition	chemical products
9599	4-Nitro-2,1,3-benzoxadiazole	16322-19-3	Contains (regardless of intentional or impurities)	chemical products
9600	Cuprate(4-), [29H,31H-phthalocyanine-2,9,16,23-tetracarboxylato(6-)-kappa,N29, kappa,N30, kappa,N31, kappa,N32]-, hydrogen (1,4), (SP-4-1)-	16337-64-7	Intentional addition / 1,000ppm	chemical products
9601	Nickel carbonates	16337-84-1	Contains (regardless of intentional or impurities)	chemical products
9602	Borane, dichloroethoxy-	16339-28-9	Intentional addition / 1%	chemical products
9603	1-Tridecene, 13-bromo-	16339-76-7	Intentional addition / 1,000ppm	chemical products
9604	Boric acid, B-hexyl-	16343-08-1	Intentional addition / 1%	chemical products
9605	Manganese ascorbate	16351-10-3	Contains (regardless of intentional or impurities)	chemical products
9606	3-(1-Methyl-2-phenylethylamino)propionitrile hydrochloride	16359-54-9	Intentional addition	chemical products
9607	3,5-Dibromobiphenyl	16372-96-6	Intentional addition / 1,000ppm	chemical products
9608	Cuprate(4-), [4-amino-5-hydroxy-3-[[4-[[2-sulfoxyethyl]sulfonyl]phenyl]azo]-6-[[2-hydroxy-5-sulphophenyl]azo]-2,7-naphthalenedisulfonato(6-)]-, tetrahydrogen	16389-59-6	Intentional addition / 1,000ppm	chemical products
9609	3-(1-Methyl-2-phenylethylamino)propionitrile	16397-28-7	Intentional addition	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
9610	1-Bromopent-2-yne	16400-32-1	Contains (regardless of intentional or impurities)	chemical products
9611	2-Bromo-3-chloropropene	16400-63-8	Intentional addition / 1,000ppm	chemical products
9612	Methyltin	16408-15-4	Intentional addition / 1,000ppm	chemical products
9613	1-Butene, 1-bromo-3-methyl-, (E)-	16416-41-4	Intentional addition / 1,000ppm	chemical products
9614	1-Pentene, 1-bromo-2-methyl-	16416-43-6	Intentional addition / 1,000ppm	chemical products
9615	1-Butene, 1-bromo-3-methyl-, (Z)-	16416-44-7	Intentional addition / 1,000ppm	chemical products
9616	1-Pentene, 1-bromo-4-methyl-, (E)-	16416-45-8	Intentional addition / 1,000ppm	chemical products
9617	Nicotine, picrate	16426-45-2	Contains (regardless of intentional or impurities)	chemical products
9618	Boron, (2-chlorobenzenamine)trifluoro-, (T-4)-	16430-93-6	Intentional addition / 1%	chemical products
9619	Chromium, tris(1-phenyl-1,3-butenedionato-0,O')-	16432-36-3	Intentional addition / 1,000ppm	chemical products
9620	Nickel, [[2-sulfonobis(4-(1,1,3,3-tetramethylbutyl)phenolato)](2-)-O1,O1',O2]-	16432-37-4	Contains (regardless of intentional or impurities)	chemical products
9621	Ferrate(4-), [[alpha_alpha-(1,2-ethanediyldimino)bis(2-hydroxybenzeneacetato)](4-)-, sodium	16455-61-1	Intentional addition / 1%	chemical products
9622	Antimony oxalate	16455-98-4	Contains (regardless of intentional or impurities)	chemical products
9623	Nitric acid, nickel(2+) salt, tetrahydrate	16456-84-1	Contains (regardless of intentional or impurities)	chemical products
9624	Butane, 2-bromo-2,3-trimethyl-	16468-75-0	Intentional addition / 1,000ppm	chemical products
9625	Yttrium hydroxide (Y(OH)3)	16469-22-0	Intentional addition / 1%	chemical products
9626	4-Chloromethylbenzyl alcohol	16473-35-1	Intentional addition / 1%	chemical products
9627	Ferrate(1-), [N-[2-bis(carboxymethyl)amino]ethyl]-N-(2-hydroxyethyl)glycinate(3-)-, sodium	16485-47-5	Intentional addition / 1%	chemical products
9628	Hydriodic acid-d, compound with nicotine (2:1)	16488-84-9	Contains (regardless of intentional or impurities)	chemical products
9629	Chlorotris(dimethylamino) phosphonium chloride	16490-49-6	Contains (regardless of intentional or impurities)	chemical products
9630	Oxirane, 2-[[phenylmethoxy)methyl]-, (2S)-	16495-13-9	Contains (regardless of intentional or impurities)	chemical products
9631	C.I. Pigment Red 64	16508-79-5	Intentional addition / 1,000ppm	chemical products
9632	Otimate sodium	16509-11-8	Contains (regardless of intentional or impurities)	chemical products
9633	Copper diarsenite	16509-22-1	Contains (regardless of intentional or impurities)	chemical products
9634	Benzenamine, 2-methyl-, hydrobromide	16518-48-2	Intentional addition / 25%	chemical products
9635	Cuprate(2-), bis[3-hydroxy-4-(phenylazo)-2-naphthalenecarboxylato(2-)-], dihydrogen	16521-34-9	Intentional addition / 1,000ppm	chemical products
9636	1,3-Benzenediol, 4,6-diamino-, dihydrochloride	16523-31-2	Intentional addition / 1%	chemical products
9637	3-Butenenitrile, 2-methyl-	16529-56-9	Intentional addition	chemical products
9638	3-Pentenenitrile, (3E)-	16529-66-1	Intentional addition	chemical products
9639	2-Heptene, 3-bromo-	16530-69-1	Intentional addition / 1,000ppm	chemical products
9640	4-Bromobenzyl cyanide	16532-79-9	Contains (regardless of intentional or impurities)	chemical products
9641	Cobalt chloride (CoCl2), dihydrate	16544-92-6	Intentional addition / 1%	chemical products
9642	Sulfuric acid, iron(2+) salt (1:2)	16547-58-3	Intentional addition / 1%	chemical products
9643	Chromic acid (H2CrO4), lanthanum(3+) salt (3:2)	16565-94-9	Contains (regardless of intentional or impurities)	chemical products
9644	Magnesium chromate pentahydrate	16569-85-0	Intentional addition / 1,000ppm	chemical products
9645	Chromic acid (H2CrO4), lanthanum(3+) salt (3:2), heptahydrate	16569-86-1	Contains (regardless of intentional or impurities)	chemical products
9646	Chromic acid (H2CrO4), neodymium(3+) salt (3:2), heptahydrate	16569-87-2	Intentional addition / 1,000ppm	chemical products
9647	Dicopper pyrophosphate hydrate	16570-28-8	Intentional addition / 1,000ppm	chemical products
9648	Hexanoic acid, manganese(2+) salt	16571-42-9	Contains (regardless of intentional or impurities)	chemical products
9649	2,3,4,5-Tetrafluorobenzonitrile	16582-93-7	Intentional addition	chemical products
9650	2-Chloro-5-nitrobenzonitrile	16588-02-6	Intentional addition	chemical products
9651	Rubidium tribromodmate	16593-57-0	Contains (regardless of intentional or impurities)	chemical products
9652	3H-Indolium, 2-[7-(1,3-dihydro-1,3,3-trimethyl-2H-indol-2-ylidene)-1,3,5-heptatrienyl]-1,3,3-trimethyl-, perchlorate	16595-48-5	Intentional addition / 1,000ppm	chemical products
9653	Levamisole hydrochloride	16595-80-5	Intentional addition / 1%	chemical products
9654	1H-Pyrazole-4-carbonitrile, 3-amino-	16617-46-2	Intentional addition	chemical products
9655	Strychnine picrate	16639-66-0	Contains (regardless of intentional or impurities)	chemical products
9656	3-Hexene, 3-bromo-, (Z)-	16645-01-5	Intentional addition / 1,000ppm	chemical products
9657	[2H3]Acetic anhydride	16649-49-3	Intentional addition / 1,000ppm	chemical products
9658	Perhydro-9b-boraphenylene	16664-33-8	Intentional addition / 1%	chemical products
9659	Chromium fluoride (CrF3), trihydrate	16671-27-5	Intentional addition / 1,000ppm	chemical products
9660	Arsenic 7I	16685-55-5	Contains (regardless of intentional or impurities)	chemical products
9661	5-Undecene, 11-bromo-, (E)-	16685-38-8	Intentional addition / 1,000ppm	chemical products
9662	1,1,1-Dibromoundecane	16696-85-4	Intentional addition / 1,000ppm	chemical products
9663	Propane, 1,1,2,3-pentachloro-	16714-68-4	Intentional addition / 1,000ppm	chemical products
9664	Tin maleate	16715-89-2	Contains (regardless of intentional or impurities)	chemical products
9665	Sodium hydrosulfide	16721-80-5	Contains (regardless of intentional or impurities)	chemical products
9666	Potassium metabisulfite	16731-55-8	Intentional addition / 1,000ppm	chemical products
9667	5-Nitro-1H-indole-2-carboxylic acid ethyl ester	16732-57-3	Intentional addition / 1%	chemical products
9668	2,2,3-Trimethylhexane	16747-25-4	Intentional addition / 1,000ppm	chemical products
9669	2,2,4-Trimethylhexane	16747-26-5	Contains (regardless of intentional or impurities)	chemical products
9670	2,3,3-Trimethylhexane	16747-28-7	Intentional addition / 1,000ppm	chemical products
9671	2,4,4-Trimethylhexane	16747-30-1	Intentional addition / 1,000ppm	chemical products
9672	Hexane, 3,3,4-trimethyl-	16747-31-2	Intentional addition / 1,000ppm	chemical products
9673	3-Ethyl-2,2-dimethylpentane	16747-32-3	Intentional addition / 1,000ppm	chemical products
9674	Pentane, 3-ethyl-2,3-dimethyl-	16747-33-4	Intentional addition / 1,000ppm	chemical products
9675	Pentane, 2,3,3,4-tetramethyl-	16747-38-9	Intentional addition / 1,000ppm	chemical products
9676	Methomyl	16752-77-5	Contains (regardless of intentional or impurities)	chemical products
9677	Hexane, 3-ethyl-2-methyl-	16789-46-1	Intentional addition / 1,000ppm	chemical products
9678	2-[[4-(Vinyloxy)butoxy)methyl]oxirane	16801-21-1	Contains (regardless of intentional or impurities)	chemical products
9679	Nickel sulfide (NiS)	16812-54-7	Contains (regardless of intentional or impurities)	chemical products
9680	Antimony compound with potassium (1:3)	16823-94-2	Contains (regardless of intentional or impurities)	chemical products
9681	Calcium picrate	16824-78-5	Contains (regardless of intentional or impurities)	chemical products
9682	Zinc dipicrate	16824-81-0	Contains (regardless of intentional or impurities)	chemical products
9683	Sulfuric acid, aluminium salt (3:2), hexadecahydrate	16828-11-8	Intentional addition / 1%	chemical products
9684	5-Cyclohexene-1,2,3,4-tetrone, 5,6-dihydroxy-, barium salt (1:1)	16833-52-6	Contains (regardless of intentional or impurities)	chemical products
9685	Cobalt hydrocarbonyl	16842-03-8	Intentional addition / 1%	chemical products
9686	[[Dimethylamino)methylene]malononitrile	16849-88-0	Intentional addition	chemical products
9687	Tungsten zirconium oxide (W2ZrO8)	16853-74-0	Contains (regardless of intentional or impurities)	chemical products
9688	2-Ethyl-7-hydroxy-1,2-benzisoxazole tetrafluoroborate	16859-20-4	Intentional addition / 1%	chemical products
9689	Platinate(2-), hexachloro-, (OC-6-11)-	16871-54-8	Contains (regardless of intentional or impurities)	chemical products
9690	Silicate(2-), hexafluoro-, zinc (1:1)-	16871-71-9	Contains (regardless of intentional or impurities)	chemical products
9691	Antimonate(1-), hexachloro-, (OC-6-11)-, nitrosyl	16871-80-0	Contains (regardless of intentional or impurities)	chemical products
9692	Silicate(2-), hexafluoro-, dipotassium	16871-90-2	Contains (regardless of intentional or impurities)	chemical products
9693	1,2-Dicarbadodecaborane(12)	16872-09-6	Intentional addition / 1%	chemical products
9694	Fluoroboric acid	16872-11-0	Contains (regardless of intentional or impurities)	chemical products
9695	Methanaminium, N,N,N-trimethyl-, tetrahydroborate(1-)	16883-45-7	Intentional addition / 1%	chemical products
9696	Diamminetetrachloroplatinum	16893-05-3	Contains (regardless of intentional or impurities)	chemical products
9697	Diammonium hexachlorotellurate(2-)	16893-14-4	Contains (regardless of intentional or impurities)	chemical products
9698	Silicate(2-), hexafluoro-, disodium	16893-85-9	Contains (regardless of intentional or impurities)	chemical products
9699	POTASSIUM HEXAFLUOROANTIMONATE	16893-92-8	Intentional addition / 1,000ppm	chemical products
9700	Dipotassium hexafluorostannate(2-)	16893-93-9	Contains (regardless of intentional or impurities)	chemical products
9701	Tetraphenylantimony Bromide	16894-69-2	Intentional addition / 1,000ppm	chemical products
9702	Hafnium oxide sulphate	16894-92-1	Intentional addition / 1%	chemical products
9703	Thallium nitrate	16901-76-1	Contains (regardless of intentional or impurities)	chemical products
9704	Tetrachlorobis(N,N-dimethylformamide-O)tin	16902-02-6	Contains (regardless of intentional or impurities)	chemical products
9705	Dicesium hexachloroplatinate	16902-25-3	Contains (regardless of intentional or impurities)	chemical products
9706	Tetrachlorosulfuric acid	16903-35-8	Intentional addition	chemical products
9707	Borate(1-), trifluorohydroxy-, hydrogen, (T-4)-	16903-52-9	Intentional addition / 1,000ppm	chemical products
9708	Copper bis(trimethylphosphine)tetrahydroborate	16903-61-0	Intentional addition / 1,000ppm	chemical products
9709	Dipotassium hexadecaplatinate	16905-14-9	Contains (regardless of intentional or impurities)	chemical products
9710	Silicate(2-), hexafluoro-, diammonium	16919-19-0	Contains (regardless of intentional or impurities)	chemical products
9711	Zirconate(2-), hexafluoro-, diammonium, (OC-6-11)-	16919-31-6	Contains (regardless of intentional or impurities)	chemical products
9712	Dichlorobis(pentane-2,4-dionato-O,O')tin	16919-46-3	Contains (regardless of intentional or impurities)	chemical products
9713	Platinate(2-), hexachloro-, diammonium, (OC-6-11)-	16919-58-7	Contains (regardless of intentional or impurities)	chemical products
9714	Carbonic acid, silver salt	16920-45-9	Intentional addition / 25%	chemical products
9715	Dipotassium hexabromoplatinate	16920-93-7	Contains (regardless of intentional or impurities)	chemical products
9716	Dipotassium hexakis(cyano-O)platinate	16920-94-8	Contains (regardless of intentional or impurities)	chemical products
9717	Potassium hexachloroplatinate(IV)	16921-30-5	Contains (regardless of intentional or impurities)	chemical products
9718	Iodine fluoride (IF7)	16921-96-3	Contains (regardless of intentional or impurities)	chemical products
9719	Platinate(2-), hexachloro-, disodium, (OC-6-11)-	16923-58-3	Contains (regardless of intentional or impurities)	chemical products
9720	Fluoroberyllic acid	16923-64-1	Contains (regardless of intentional or impurities)	chemical products
9721	Chromate(2-), [N-[[4-(4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]phenyl]-2-propanamidato(2-)-]3-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-hydrobenzenesulfonato(3-)-], dihydrogen	16923-74-3	Contains (regardless of intentional or impurities)	chemical products
9722	Zirconium potassium fluoride	16923-95-8	Contains (regardless of intentional or impurities)	chemical products
9723	Stannate(2-), hexafluoro-, disodium, (OC-6-11)-	16924-51-9	Contains (regardless of intentional or impurities)	chemical products
9724	Antimonate(1-), hexafluoro-, sodium, (OC-6-11)-	16925-25-0	Contains (regardless of intentional or impurities)	chemical products
9725	Zirconate(2-), hexafluoro-, disodium, (OC-6-11)-	16925-26-1	Contains (regardless of intentional or impurities)	chemical products
9726	Ammonium hexabromotellurate(IV)	16925-35-2	Contains (regardless of intentional or impurities)	chemical products
9727	2,6-Dimethylbenzonitrile	16932-49-3	Intentional addition	chemical products
9728	Sodium hydroxymethoxyborate(1-)	16940-17-3	Intentional addition / 1%	chemical products
9729	Sodium borohydride	16940-66-2	Contains (regardless of intentional or impurities)	chemical products
9730	Hexafluorophosphoric acid	16940-81-1	Contains (regardless of intentional or impurities)	chemical products
9731	Phosphate(1-), hexafluoro-, ammonium	16941-11-0	Intentional addition / 1,000ppm	chemical products
9732	Chloroplatinic acid	16941-12-1	Contains (regardless of intentional or impurities)	chemical products
9733	Lithium borohydride	16949-15-8	Contains (regardless of intentional or impurities)	chemical products
9734	Silicate(2-), hexafluoro-, magnesium (1:1)	16949-65-8	Contains (regardless of intentional or impurities)	chemical products
9735	Antimonate(1-), hexafluoro-, hydrogen, (OC-6-11)-	16950-06-4	Contains (regardless of intentional or impurities)	chemical products
9736	Stannate(2-), hexachloro-, diammonium, (OC-6-11)-	16960-53-5	Contains (regardless of intentional or impurities)	chemical products
9737	Gold chloride, trihydrate	16961-25-4	Intentional addition	chemical products
9738	Calcium hexafluorosilicate dihydrate	16961-80-1	Intentional addition / 1,000ppm	chemical products
9739	Fluorosilicic acid	16961-83-4	Contains (regardless of intentional or impurities)	chemical products
9740	Titanate(2-), hexafluoro-, diammonium, (OC-6-11)-	16962-40-6	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
9871	Nickel nitrite	17861-62-0	Contains (regardless of intentional or impurities)	chemical products
9872	4-(Trimethylsilyl)phenylboronic acid	17865-11-1	Intentional addition / 1%	chemical products
9873	Antimony hydroxyacetate	17901-09-6	Contains (regardless of intentional or impurities)	chemical products
9874	Cyclohexane, 1,1'-methylenebis[4-isocyanato-, [cis(trans)]-	17901-48-3	Intentional addition / 1,000ppm	chemical products
9875	1-Chloro-4-methoxybutane	17913-18-7	Contains (regardless of intentional or impurities)	chemical products
9876	Aluminum sulfate hydrate	17927-65-0	Intentional addition / 1,000ppm	chemical products
9877	Propanenitrile, 2-(triethoxysilyl)-	17932-62-6	Intentional addition	chemical products
9878	Boronic acid, B-(3-methylphenyl)-	17933-03-8	Intentional addition / 1%	chemical products
9879	Tributylstannyltrimethylsilane	17955-46-3	Intentional addition / 1,000ppm	chemical products
9880	1,3-Dichloro-1,1,3,3-tetraethyl-distannoxane	17973-92-9	Contains (regardless of intentional or impurities)	chemical products
9881	2,4,6-Trisopropylphenylmercuric chloride	17974-95-7	Contains (regardless of intentional or impurities)	chemical products
9882	Oxetane, 1,1,1,7-tetrachloro-3,5-dimethyl-	17977-23-0	Intentional addition / 1,000ppm	chemical products
9883	Sodium triethylthioborate(1-)	17979-81-6	Intentional addition / 1%	chemical products
9884	Barium acrylate	17989-90-1	Intentional addition / 1,000ppm	chemical products
9885	2-(Tributylstannyl)pyridine	17997-47-6	Contains (regardless of intentional or impurities)	chemical products
9886	Heptanoic acid, 2,2,3,3,4,4,5,5,6,6,7,7,7-dodecafluoro-6-(trifluoromethyl)-, sodium salt (1:1)	18017-22-6	Intentional addition / 100ppm	chemical products
9887	Uranium dioxide bis(2,4-pentanedionato-O,O')-, (OC-6-11)-	18039-69-5	Contains (regardless of intentional or impurities)	chemical products
9888	Tetraammonium uranyl tricarbonate, of uranium depleted in uranium-235	18077-77-5	Contains (regardless of intentional or impurities)	chemical products
9889	Diborane(4)	18099-45-1	Intentional addition / 1%	chemical products
9890	Ethanedioic acid, cobalt salt	18130-42-2	Intentional addition / 1%	chemical products
9891	1-Piperidinepropionitrile, 4,4'-trimethylenedi-	18136-00-0	Intentional addition	chemical products
9892	Ferrate(1-), [[N,N'-1,2-ethanediybis[N-(carboxymethyl)glycinato]](4-)-N,N',O',O',ON,ON']-, sodium, trihydrate, (OC-6-21)-	18154-32-0	Intentional addition / 1%	chemical products
9893	Manganate(1-), trifluoro-	18154-90-0	Contains (regardless of intentional or impurities)	chemical products
9894	Butanenitrile, 4-(chlorodimethylsilyl)-	18156-15-5	Intentional addition	chemical products
9895	Triaminemolybdenum tricarbonyl	18177-91-8	Intentional addition / 1%	chemical products
9896	Nickel(II) carbonate hexahydrate	18195-55-6	Contains (regardless of intentional or impurities)	chemical products
9897	Cobalt dichloride monohydrate	18201-52-0	Intentional addition / 1%	chemical products
9898	4-(2-Chloroethyl)phenyl methyl ether	18217-00-0	Contains (regardless of intentional or impurities)	chemical products
9899	Tin, dichloro[29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (OC-6-12)-	18253-54-8	Contains (regardless of intentional or impurities)	chemical products
9900	Peroxyacetic acid, 1,1-dimethylbutyl ester	18260-97-4	Contains (regardless of intentional or impurities)	chemical products
9901	2-Chlorobenzylidene malononitrile	18270-61-6	Intentional addition	chemical products
9902	Plumbane, diacetoxylidipropyl-	18279-19-1	Contains (regardless of intentional or impurities)	chemical products
9903	Tin oxide (SnO2)	18282-10-5	Contains (regardless of intentional or impurities)	chemical products
9904	Benzene, 4-bromo-1,2-dichloro-	18282-59-2	Intentional addition / 1,000ppm	chemical products
9905	Citric acid, ammonium nickel salt	18283-82-4	Contains (regardless of intentional or impurities)	chemical products
9906	Boric acid, sodium salt, compound with hydrogen peroxide (1:1), trihydrate	18283-88-0	Intentional addition / 1%	chemical products
9907	Tetraborane	18283-93-7	Intentional addition / 1%	chemical products
9908	Cobalt, [3-hydroxy-4-[[1-(p-mercaptophenyl)-3-methyl-5-oxo-2-pyrazolin-4-yl]azo]-o-benzenesulfonamididato(2-)]-, S-(hydrogen sulfate), monosodium salt	18285-21-7	Intentional addition / 1,000ppm	chemical products
9909	Benzene, 1-methyl-2,3,6-trinitro-	18292-97-2	Intentional addition / 1%	chemical products
9910	(Trimethylsilyl)acetone nitrile	18293-53-3	Intentional addition	chemical products
9911	Butane, 2-bromo-3-methyl-	18295-25-5	Intentional addition / 1,000ppm	chemical products
9912	Pentadecanenitrile	18300-91-9	Contains (regardless of intentional or impurities)	chemical products
9913	Oxotanic acid, zirconium salt	18312-04-4	Contains (regardless of intentional or impurities)	chemical products
9914	Alanine, 3-selenyl-	18312-66-8	Contains (regardless of intentional or impurities)	chemical products
9915	Dihydrogen [4-[3,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulphonato(3-)]-[1-[2-hydroxy-5-(phenylazo)phenyl]azo]-2-naphthalato(2-)]chromato(2-)	18324-39-5	Contains (regardless of intentional or impurities)	chemical products
9916	Bis(2-aminophenolato-N,O)copper	18347-30-3	Intentional addition / 1,000ppm	chemical products
9917	4,4-Diethoxybutanenitrile	18381-45-8	Intentional addition	chemical products
9918	Phenol, 2,4,6-trinitro-, lithium salt	18390-55-1	Contains (regardless of intentional or impurities)	chemical products
9919	Bis(2-ethylhexyl) 4,4,11,11-tetrabutyl-6,9-dioxo-5,10-dioxo-3,12-dithia-4,11-distannatetradec-7-enediote	18403-67-3	Contains (regardless of intentional or impurities)	chemical products
9920	Disulphurous acid, sodium salt	18403-71-9	Intentional addition / 1%	chemical products
9921	Triphosphoric acid, zinc salt	18428-70-1	Intentional addition / 25%	chemical products
9922	Zirconium, chlorohydroxyoxo-	18428-88-1	Contains (regardless of intentional or impurities)	chemical products
9923	Zinc hexafluorosilicate hexahydrate	18433-42-6	Contains (regardless of intentional or impurities)	chemical products
9924	Uranyl phosphate	18433-48-2	Contains (regardless of intentional or impurities)	chemical products
9925	Pentaborane(11)	18433-84-6	Intentional addition / 1,000ppm	chemical products
9926	Lead chromate oxide	18454-12-1	Contains (regardless of intentional or impurities)	chemical products
9927	Tin diphosphate	18472-93-0	Contains (regardless of intentional or impurities)	chemical products
9928	Cobalt dinitrite	18488-96-5	Intentional addition / 1%	chemical products
9929	Propane, 1,1,2,3-tetrachloro-	18495-30-2	Intentional addition / 1,000ppm	chemical products
9930	Platinum dinitrate	18496-40-7	Contains (regardless of intentional or impurities)	chemical products
9931	Platinate(2-), hexachloro-, dihydrogen, hexahydrate, (OC-6-11)-	18497-13-7	Contains (regardless of intentional or impurities)	chemical products
9932	1H-Imidazol-4-ylacetone nitrile	18502-05-1	Intentional addition	chemical products
9933	Ammonium cadmium chloride	18532-52-0	Contains (regardless of intentional or impurities)	chemical products
9934	Rubidium trichlorocadmate	18532-58-6	Contains (regardless of intentional or impurities)	chemical products
9935	Nitric acid, nickel(2+) salt, octahydrate	18534-07-1	Contains (regardless of intentional or impurities)	chemical products
9936	Zinc dinitrate octahydrate	18534-08-2	Intentional addition / 1%	chemical products
9937	Pyrylium, 2,4,6-tris(4-methoxyphenyl)-, perchlorate	18540-32-4	Intentional addition / 1,000ppm	chemical products
9938	4-Octene, 1-bromo-5-propyl-	18545-36-3	Intentional addition / 1,000ppm	chemical products
9939	Potassium tris(1-pyrazolyl)borohydride	18583-60-3	Intentional addition / 1%	chemical products
9940	1,3-Naphthalenedisulfonic acid, 7-amino, dipotassium salt	18589-26-9	Contains (regardless of intentional or impurities)	chemical products
9941	Bis[[2,2'-[ethylenbis(nitriomethylidene)]bis[phenolato]](2-)-N,N',O',O']-, mu.-oxodiiron	18601-34-8	Contains (regardless of intentional or impurities)	chemical products
9942	Cyanamide, cyano-, zinc salt	18622-28-1	Intentional addition / 25%	chemical products
9943	Cobaltate(1-), bis[1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphthalenato(2-)]-, sodium	18639-97-9	Intentional addition / 1,000ppm	chemical products
9944	Nickel fluoride (NiF3)	18642-20-1	Contains (regardless of intentional or impurities)	chemical products
9945	Octane, 2-chloro-, (R)-	18651-57-5	Intentional addition / 1,000ppm	chemical products
9946	Sulfamic acid, tin(2+) salt (2:1)	18653-83-3	Contains (regardless of intentional or impurities)	chemical products
9947	Phosphoric acid, manganese(2+) salt (2:1)	18718-07-5	Contains (regardless of intentional or impurities)	chemical products
9948	Phosphoric acid, cobalt(2+) salt (2:1)	18718-10-0	Intentional addition / 1,000ppm	chemical products
9949	Nickel bis(dihydrogen phosphate)	18718-11-1	Contains (regardless of intentional or impurities)	chemical products
9950	Phosphoric acid, copper(2+) salt (2:1)	18718-12-2	Intentional addition / 1,000ppm	chemical products
9951	Nickel(2+) hydrogen citrate	18721-51-2	Contains (regardless of intentional or impurities)	chemical products
9952	Cobalt(2+) hydrogen citrate	18727-04-3	Intentional addition / 1%	chemical products
9953	2-(2-Bromoethyl)-1,3-dioxolane	18742-02-4	Intentional addition / 1%	chemical products
9954	Ethylene diamine tetraacetic acid disodium barium	18744-58-6	Intentional addition / 1,000ppm	chemical products
9955	Chromium, [o-[[1-(p-mercaptophenyl)-3-methyl-5-oxo-2-pyrazolin-4-yl]azo]benzoato(2-)]-, mono(hydrogen sulfate) (ester), monosodium salt	18756-42-8	Contains (regardless of intentional or impurities)	chemical products
9956	Chromium, [4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-(p-mercaptophenyl)-3-methyl-2-pyrazolin-5-onato(2-)]-, S-(hydrogen sulfate), monosodium salt	18756-44-0	Contains (regardless of intentional or impurities)	chemical products
9957	Sodium nickel(II) tartrate	18756-97-3	Contains (regardless of intentional or impurities)	chemical products
9958	Antimony(3+) tripropan-2-olate	18770-47-3	Contains (regardless of intentional or impurities)	chemical products
9959	Tetrakis(pentane-2,4-dionato-O,O')vanadium	18785-90-3	Intentional addition / 1%	chemical products
9960	4-Ethylthiophenyl methylcarbamate	18809-57-9	Intentional addition	chemical products
9961	Barium azide	18810-57-7	Contains (regardless of intentional or impurities)	chemical products
9962	Manganese sulfide (MnS)	18820-29-6	Contains (regardless of intentional or impurities)	chemical products
9963	Tris(triphenylsiloxy)vanadium oxide	18822-50-9	Intentional addition / 1%	chemical products
9964	2,2-Dibutyl-1,3,11-tetraoxa-2-stannacyclooctadeca-5,13-diene-4,7,12,15-tetrono	18824-11-8	Contains (regardless of intentional or impurities)	chemical products
9965	1,2-Benzenedicarboxylic acid, 3,4,5,6-tetrabromo-, nickel(2+) salt (1:1)	18824-79-8	Contains (regardless of intentional or impurities)	chemical products
9966	1,3,5-Triazine-2,4,6-(1H,3H,5H)-trione, compound with hydrazine (1:1)	18836-29-8	Contains (regardless of intentional or impurities)	chemical products
9967	Phosphorothioic acid, O,O-diethyl O-(5-phenyl-3-isoxazolyl) ester	18854-01-8	Contains (regardless of intentional or impurities)	chemical products
9968	Hafnium sulfide (HfS2)	18855-94-2	Intentional addition / 1%	chemical products
9969	Molybdenum oxide (MoO2)	18868-43-4	Contains (regardless of intentional or impurities)	chemical products
9970	Barium 142	18879-37-3	Contains (regardless of intentional or impurities)	chemical products
9971	Strychnine, mono[[1-(triethylsilyl)ethyl]thio]acetate]	18880-53-0	Contains (regardless of intentional or impurities)	chemical products
9972	Hydroxylamine, sulfite (1:1) (salt)	18891-24-2	Intentional addition / 1%	chemical products
9973	Cadmium, bis(1-hydroxy-2(1H)-pyridinethionato)-	18897-36-4	Contains (regardless of intentional or impurities)	chemical products
9974	Copper chromate oxide (Cu2CrO4O)	18906-50-8	Contains (regardless of intentional or impurities)	chemical products
9975	Heptane, 3-bromo-3-methyl-	18908-60-6	Intentional addition / 1,000ppm	chemical products
9976	Heptane, 3-(bromomethyl)-	18908-66-2	Intentional addition / 1,000ppm	chemical products
9977	Rubidium tetrafluoroborate(1-)	18909-68-7	Intentional addition / 1%	chemical products
9978	Cesium tetrafluoroborate	18909-69-8	Intentional addition / 1%	chemical products
9979	Copper diglycolate	18911-01-8	Intentional addition / 1,000ppm	chemical products
9980	Manganate(1-), tris(salicylato)-, hydrogen, compound with nicotine and salicylic acid (1:2:1)	18911-12-1	Contains (regardless of intentional or impurities)	chemical products
9981	Manganese disalicylate	18917-85-6	Contains (regardless of intentional or impurities)	chemical products
9982	Manganese hydroxide (Mn(OH)2)	18933-05-6	Contains (regardless of intentional or impurities)	chemical products
9983	2-Methylbutyronitrile	18936-17-9	Contains (regardless of intentional or impurities)	chemical products
9984	Cyclohexane, 1,1'-methylenebis[4-isocyanato-, [cis(cis)]-	18937-00-3	Intentional addition / 1,000ppm	chemical products
9985	Sulfuric acid, copper(2+) salt	18939-61-2	Intentional addition / 1,000ppm	chemical products
9986	Bis(tetrabutylammonium) bis(maleonitriledithiolato)nickel(II) complex	18958-57-1	Contains (regardless of intentional or impurities)	chemical products
9987	1-Butanaminium, N,N,N-tributyl-, (SP-4-1)-bis[2,3-d(mercapto-kappa-S)-2-butenedinitrilo(2-)]nickelate(1-)(1:1)	18958-62-8	Contains (regardless of intentional or impurities)	chemical products
9988	Nonyl (Z,Z)-6,6-butyl-4,8,11-trioxo-5,7,12-trioxo-6-stannahexacoa-2,9-dienoate	18961-66-5	Contains (regardless of intentional or impurities)	chemical products
9989	Benzene, 1,2-dichloro-4-methyl-5-(trichloromethyl)-	18964-69-7	Contains (regardless of intentional or impurities)	chemical products
9990	Tricopperdimolybdenum oxide monohydrate	18967-85-6	Intentional addition / 1%	chemical products
9991	2,3-Pyridinedicarboxylic acid, copper(2+) salt (1:1)	18970-62-2	Intentional addition / 1,000ppm	chemical products
9992	Magnesium hexafluorosilicate hexahydrate	18972-56-0	Contains (regardless of intentional or impurities)	chemical products
9993	Nickel(2+), bis(1,2-propanediamine)-, bis(dicyanoaurate(1-))	18972-69-5	Contains (regardless of intentional or impurities)	chemical products
9994	Copper(2+), (tetraethylenepentamine)-, bis(dicyanoaurate(1-))	18972-70-8	Contains (regardless of intentional or impurities)	chemical products
9995	Bis(cyano-o)cuprate(1-)	18973-62-1	Intentional addition / 1,000ppm	chemical products
9996	Copper(2+), bis(ethylenediamine)-, bis(dicyanoaurate(1-))	18974-18-0	Contains (regardless of intentional or impurities)	chemical products
9997	Cadmium(2+), bis(ethylenediamine)-, bis(dicyanoaurate(1-))	18974-20-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
9998	Beryllate(1-), [N,N-bis(carboxymethyl)glycinate(3-)-N,O,O']-, potassium, (T-4)-	18983-72-7	Contains (regardless of intentional or impurities)	chemical products
9999	Bis(methyldithiocarbamate-S,S')zinc	18984-32-2	Intentional addition	chemical products
10000	Nickel, bis(hydroxyacetato-O1,O2)-	18984-98-0	Contains (regardless of intentional or impurities)	chemical products
10001	Selenonium, trimethyl-, chloride	18987-38-7	Contains (regardless of intentional or impurities)	chemical products
10002	Dihydrogen [4-hydroxy-3-[(3-methyl-5-oxo-1-phenyl-2-pyrazolin-4-yl)azo]benzene-1-sulphonato(3-)]-1-[[2-hydroxy-5-(phenylazo)phenyl]azo]-2-naphtholato(2-)-]chromate(2-)	18987-99-0	Contains (regardless of intentional or impurities)	chemical products
10003	Cadmium diphenolate	18991-05-4	Contains (regardless of intentional or impurities)	chemical products
10004	Butyl bromoacetate	18991-98-5	Contains (regardless of intentional or impurities)	chemical products
10005	Nitric acid, copper(2+) salt, hydrate	19004-19-4	Intentional addition / 1,000ppm	chemical products
10006	Cadmium, bis(dipentylcarbamodithioato-S,S')-, (T-4)-	19010-65-2	Contains (regardless of intentional or impurities)	chemical products
10007	Cadmium disilylate	19010-79-8	Contains (regardless of intentional or impurities)	chemical products
10008	Propionic acid, cobalt salt	19019-51-3	Intentional addition / 1%	chemical products
10009	2-Propenylammonium, 1,1,2,3,4-pentachloro-, (OC-6-11)-hexachloroantimonate(1-)	19033-83-7	Contains (regardless of intentional or impurities)	chemical products
10010	Phosphoric acid, aluminum iron salt	19034-12-9	Intentional addition / 1%	chemical products
10011	Propane, 2-bromo-1,1,3,3-tetrafluoro-	19041-01-1	Intentional addition / 1,000ppm	chemical products
10012	2-Chloro-1,1,3,3-tetrafluoropropane	19041-02-2	Intentional addition / 1,000ppm	chemical products
10013	Hexakis(mu-(acetato-O,O'))-mu,4-oxotetraberyllium	19049-40-2	Contains (regardless of intentional or impurities)	chemical products
10014	Cobalt, [4-hydroxy-3-[[1-(p-mercaptophenyl)-3-methyl-5-oxo-2-pyrazolin-4-yl]azo]-o-benzenesulfonophenetidato(2-)]-, S-(hydrogen sulfate), monosodium salt	19052-32-5	Intentional addition / 1,000ppm	chemical products
10015	Boric acid (HBO2), aluminum salt	19088-11-0	Intentional addition / 1,000ppm	chemical products
10016	Hydroxylamine, phosphate (1:1) (salt)	19098-16-9	Contains (regardless of intentional or impurities)	chemical products
10017	Isosvaleric acid, iron salt	19105-78-3	Intentional addition / 1%	chemical products
10018	Heptanoic acid, cobalt salt	19106-33-3	Intentional addition / 1%	chemical products
10019	Vanadic acid, triisobutyl ester	19120-62-8	Intentional addition / 1%	chemical products
10020	Cinnabar	19122-79-3	Contains (regardless of intentional or impurities)	chemical products
10021	Boron, trifluoro[2,2,2'-(nitrido-kappa-N)tris[ethano]]-, (T-4)-	19142-30-4	Intentional addition / 1%	chemical products
10022	Oleic acid, manganese salt (1:?)	19153-79-8	Contains (regardless of intentional or impurities)	chemical products
10023	Sulfurous acid, gold(1+) sodium salt (2:1:3)	19153-98-1	Intentional addition	chemical products
10024	Sulfurous acid, gold(1+) potassium salt (2:1:3)	19153-99-2	Intentional addition	chemical products
10025	Chromate(5-), bis[3-[(5-chloro-2-hydroxyphenyl)azo]-4,5-dihydroxy-2,7-naphthalenedisulfonato(4-)]-, pentahydrogen	19154-29-1	Contains (regardless of intentional or impurities)	chemical products
10026	Chromate(3-), bis[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)]-, trihydrogen	19154-30-4	Contains (regardless of intentional or impurities)	chemical products
10027	Chromate(3-), bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-1-naphthalenesulfonato(3-)]-, trihydrogen	19154-31-5	Contains (regardless of intentional or impurities)	chemical products
10028	Zinc nitrate tetrahydrate	19154-63-3	Intentional addition / 1%	chemical products
10029	p-Toluenesulphonyl cyanide	19158-51-1	Contains (regardless of intentional or impurities)	chemical products
10030	(OC-6-12)-Tetraaminedichlorocobalt	19173-71-8	Intentional addition / 1%	chemical products
10031	3,5-Dimethoxybenzonitrile	19179-31-8	Intentional addition	chemical products
10032	Copper dilaurate	19179-44-3	Intentional addition / 1,000ppm	chemical products
10033	Beryllate(1-), trifluoro-	19181-26-1	Contains (regardless of intentional or impurities)	chemical products
10034	1,4-Dinitro-1H-imidazole	19182-81-1	Contains (regardless of intentional or impurities)	chemical products
10035	Yttrium, tris(6,6,7,7,8,8,8-heptafluoro-2,2-dimethyl-3,5-octanedionato-beta,O,beta,O')	19186-73-3	Intentional addition / 1%	chemical products
10036	1-Propanol, 3-bromo-2,2-bis(bromomethyl)-, phosphate (3:1)	19186-97-1	Intentional addition / 900ppm	chemical products
10037	Selenocyanic acid, p-nitrophenyl ester	19188-18-2	Contains (regardless of intentional or impurities)	chemical products
10038	Cobalt dioleate	19192-71-3	Intentional addition / 1,000ppm	chemical products
10039	3-Hexene, 1-bromo-4-methyl-	19198-88-0	Intentional addition / 1,000ppm	chemical products
10040	Zinc dithiophosphate	19210-06-1	Intentional addition / 25%	chemical products
10041	Dihydrogen bis(L-glutamate(2-)-N,O1)cobaltate(2-)	19224-80-7	Intentional addition / 1,000ppm	chemical products
10042	Dichlorobis(trimethylphosphine)nickel(II)	19232-05-4	Contains (regardless of intentional or impurities)	chemical products
10043	Diphosphoric acid, zinc salt	19262-92-1	Intentional addition / 25%	chemical products
10044	Diphosphoric acid, cadmium salt	19262-93-2	Contains (regardless of intentional or impurities)	chemical products
10045	Dioctyltin phosphite	19269-42-2	Intentional addition / 1,000ppm	chemical products
10046	1-Dibenzyl-2-(chloromethyl)imidazole hydrochloride	19276-03-0	Contains (regardless of intentional or impurities)	chemical products
10047	Diborane	19287-45-7	Contains (regardless of intentional or impurities)	chemical products
10048	Sulphuric acid, silver salt	19287-89-9	Intentional addition / 25%	chemical products
10049	Sulfuric acid, tin(4+) salt (2:1)	19307-28-9	Contains (regardless of intentional or impurities)	chemical products
10050	Boric acid, dibutyl-, 2-aminoethyl ester	19324-14-2	Intentional addition / 1%	chemical products
10051	Cobalt(2+) ethanolate	19330-29-1	Intentional addition / 1,000ppm	chemical products
10052	Cuprate(2-), [[N,N'-1,2-cyclohexanediy]bis[N-(carboxymethyl)glycinate]([4-)-N,N',O,O',ON,ON']-, [OC-6-21-(trans)]-	19332-78-6	Intentional addition / 1,000ppm	chemical products
10053	Nicotinic compound with zinc hexafluoroarsenate(2-)(1:1)	19333-07-4	Contains (regardless of intentional or impurities)	chemical products
10054	Diphosphoric acid, nickel(2+) salt	19372-20-4	Contains (regardless of intentional or impurities)	chemical products
10055	Diphosphoric acid, copper(2+) salt	19372-21-5	Intentional addition / 1,000ppm	chemical products
10056	Platinate(2-), hexakis(thiocyanato-S)-, diammonium (OC-6-11)-	19372-45-3	Contains (regardless of intentional or impurities)	chemical products
10057	Benzenemethaniminium, N-dodecyl-N,N-bis(2-hydroxyethyl)-, chloride	19379-90-9	Intentional addition / 1,000ppm	chemical products
10058	C.I. Acid Green 1	19381-50-1	Intentional addition / 1%	chemical products
10059	Reaction product of 4,4'-oxydiphenol and 1-chloro-2,3-epoxypropane	19389-73-2	Contains (regardless of intentional or impurities)	chemical products
10060	1-Bromo-2,6-dichlorobenzene	19393-92-1	Intentional addition / 1,000ppm	chemical products
10061	1,4-Dibromobutan-2-ol	19398-47-1	Intentional addition / 1%	chemical products
10062	Pentane, 2,4-dibromo-	19398-53-9	Intentional addition / 1,000ppm	chemical products
10063	Boron, [2-(amino-kappa-N)ethano]trifluoro-, (T-4)-	19399-03-2	Intentional addition / 1%	chemical products
10064	1,2,3,7,8,9-Hexachlorodibenzop-d-dioxin	19408-74-3	Intentional addition / 1,000ppm	chemical products
10065	Zinc chloride (ZnCl2), dihydrate	19417-15-3	Intentional addition / 1,000ppm	chemical products
10066	Molybdenum potassium oxide (Mo2K2O7)	19421-45-5	Intentional addition / 1%	chemical products
10067	Platinate(1-), bis(1-acetyl-2-oxopropyl)(2,4-pentanedionato-O,O')-, potassium, (SP-4-2)-	19426-59-6	Contains (regardless of intentional or impurities)	chemical products
10068	Cuprate(1-), [9-ethenyl-14-ethyl-21-(methoxycarbonyl)-4,8,13,18-tetramethyl-20-oxo-3-phosphoropropanoato(3-)-N23,N24,N25,N26]-, hydrogen, [SP-4-2-[3S-(3.alpha.4.beta.21.beta.)]]-	19426-70-1	Intentional addition / 1,000ppm	chemical products
10069	Hydrogen [3S-(3.alpha.4.beta.21.beta.)]-[14-ethyl-13-formyl-21-(methoxycarbonyl)-4,8,18-trimethyl-20-oxo-9-vinylphosphorino-3-propanoato(3-)-N23,N24,N25,N26]cuprate(1-)	19426-73-4	Intentional addition / 1,000ppm	chemical products
10070	Di-tert-butylchlorostannane	19429-30-2	Contains (regardless of intentional or impurities)	chemical products
10071	1-Hexene, 3,3,4,4,5,5,6,6,6-nonafluoro-	19430-93-4	Intentional addition / 1,000ppm	chemical products
10072	Chromate(1-), diamminetetrais(isothiocyanato)-, ammonium, hydrate (3:2)	19441-09-9	Contains (regardless of intentional or impurities)	chemical products
10073	Aluminum, bis(ethyl 3-oxobutanoato-O1',O3')(2,4-pentanedionato-O,O')	19443-16-4	Intentional addition / 1,000ppm	chemical products
10074	Stannane, (acetyloxy)tris(1-methylethyl)-	19464-55-2	Contains (regardless of intentional or impurities)	chemical products
10075	Nonaborane	19465-30-6	Intentional addition / 1%	chemical products
10076	(2-Bromophenyl)acetonitrile	19472-74-3	Contains (regardless of intentional or impurities)	chemical products
10077	9,10-Anthracenedione, 2-acetyl-1,4-diamino-	19500-94-8	Contains (regardless of intentional or impurities)	chemical products
10078	Sulfuric acid, chromium(3+) salt (3:2), hexadecahydrate	19512-14-2	Intentional addition / 1,000ppm	chemical products
10079	Acetic acid, manganese(3+) salt, dihydrate	19513-05-4	Contains (regardless of intentional or impurities)	chemical products
10080	Nicotine, conjugate monoacid	19527-02-7	Contains (regardless of intentional or impurities)	chemical products
10081	Diethylenetriaminepentaacetic acid, disodium iron(III) salt	19529-38-5	Intentional addition / 1%	chemical products
10082	Ferrate(2-), [N,N-bis[2-[bis(carboxymethyl)amino]ethyl]glycinate(5-)]-, dipotassium, (PB-7-13-12564)-	19529-39-6	Intentional addition / 1%	chemical products
10083	Ferrate(2-), [N,N-bis[2-[bis(carboxymethyl)amino]ethyl]glycinate(5-)]-, ammonium, hydrogen	19529-40-9	Intentional addition / 1%	chemical products
10084	Tetrakis(phosphorus trifluoride)platinum	19529-53-4	Contains (regardless of intentional or impurities)	chemical products
10085	Lithium (cyano-O)trihydroborate(1-)	19536-84-6	Intentional addition / 1%	chemical products
10086	Trimethyl(trimethylamine)indium	19567-64-7	Intentional addition / 1%	chemical products
10087	Hexanoic acid, 2-ethyl-, iron salt	19583-54-1	Intentional addition / 1%	chemical products
10088	Sodium hexachloroplatenate(V) hexahydrate	19583-77-8	Contains (regardless of intentional or impurities)	chemical products
10089	Chromate(2-), [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-[4-[(1-oxo-2-propenyl)amino]phenyl]-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(3-)]-[[4-[(5-chloro-2-hydroxyphenyl)azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen	19583-99-4	Contains (regardless of intentional or impurities)	chemical products
10090	Tri-mu-carbonylnonacarbonyl-tetrahydro-tetrarhodium	19584-30-6	Contains (regardless of intentional or impurities)	chemical products
10091	Morpholine, tetrafluoroborate(1-)	19585-43-4	Intentional addition / 1%	chemical products
10092	Benzenesulfonic acid, 3-dodecyl-, sodium salt	19589-59-4	Intentional addition / 1%	chemical products
10093	Pentaborane	19624-22-7	Contains (regardless of intentional or impurities)	chemical products
10094	Stannate(2-), [[N,N'-1,2-ethanediy]bis[N-(carboxymethyl)glycinate]([4-)-N,N',O,O',ON,ON']-, (OC-6-21)-	19632-45-2	Intentional addition / 1,000ppm	chemical products
10095	Bis(dimethyldithiocarbamate-S,S')selenium	19632-73-6	Contains (regardless of intentional or impurities)	chemical products
10096	Hydroxytetraphenylantimony	19638-16-5	Contains (regardless of intentional or impurities)	chemical products
10097	Monopotassium phenylamide	19642-99-0	Contains (regardless of intentional or impurities)	chemical products
10098	Bis(hexafluoroacetylacetonato)cobalt(II) hydrate	19648-83-0	Intentional addition / 1%	chemical products
10099	Propanenitrile, 3-[[4-[(2-chloro-4-nitrophenyl)azo]phenyl](2-phenylethyl)amino]-	19649-68-4	Contains (regardless of intentional or impurities)	chemical products
10100	Anilincadmium dilactate	19651-91-3	Contains (regardless of intentional or impurities)	chemical products
10101	Copper methacrylate	19662-59-0	Intentional addition / 1,000ppm	chemical products
10102	Hydroxy[[2,2,2'-(nitritoltris[ethanolato]([3-)-N,O,O',O']oxomolybdenum	19663-15-1	Contains (regardless of intentional or impurities)	chemical products
10103	Butyric acid, manganese salt	19664-95-0	Contains (regardless of intentional or impurities)	chemical products
10104	Oxadiazon	19666-30-9	Contains (regardless of intentional or impurities)	chemical products
10105	Bis(diethyldithiocarbamato)dioxomolybdenum(VI)	19680-83-2	Intentional addition / 1%	chemical products
10106	Zirconate(2-), oxobis[sulfato(2-)-O,O']-, dihydrogen	19696-82-3	Contains (regardless of intentional or impurities)	chemical products
10107	Dibutylbis(1-oxohexyloxy)stannane	19704-60-0	Contains (regardless of intentional or impurities)	chemical products
10108	Hexadecyl (2,2)-6-dibutyl-4,8,11-trioxo-5,7,12-trioxo-6-stannahexaosa-2,9-dienoate	19706-58-2	Contains (regardless of intentional or impurities)	chemical products
10109	2,2'-Azobis(2-hydroxyethyl)propionitrile	19706-80-0	Contains (regardless of intentional or impurities)	chemical products
10110	Chromate(5-), bis[5-amino-4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-2,7-naphthalenedisulfonato(4-)]-, pentahydrogen	19717-98-7	Contains (regardless of intentional or impurities)	chemical products
10111	6-Nitroindoline	19727-83-4	Intentional addition / 1%	chemical products
10112	Heptanoic acid, 2,2,3,3,4,4,5,5,6,6,7,7,7-dodecafluoro-6-(trifluoromethyl)-, ammonium salt (1:1)	19742-57-5	Intentional addition / 100ppm	chemical products
10113	N-(4-Chloro-o-tolyl)-N,N-dimethylformamide monohydrochloride	19750-95-9	Contains (regardless of intentional or impurities)	chemical products
10114	Benzene, 1-bromo-3,5-dichloro-	19752-55-7	Intentional addition / 1,000ppm	chemical products
10115	Methyl hydroxymethoxyacetate	19757-97-2	Contains (regardless of intentional or impurities)	chemical products
10116	Zirconium bis(dihydrogenorthophosphate) oxide	19764-74-0	Contains (regardless of intentional or impurities)	chemical products
10117	Tetrakis(dimethylamido)hafnium(IV)	19782-68-4	Intentional addition / 1%	chemical products
10118	Biphenyl, 4-hydroxy-4'-cyano-	19812-93-2	Intentional addition	chemical products
10119	Tetrakis(diethylamido)hafnium(IV)	19824-55-6	Intentional addition / 1%	chemical products
10120	Pyrazinecarbonitrile	19847-12-2	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
10121	Gallium(3+) perchlorate	19854-31-0	Intentional addition / 1,000ppm	chemical products
10122	Barium sebacate	19856-32-7	Contains (regardless of intentional or impurities)	chemical products
10123	Thallium, chlorodiphenyl-	19859-84-8	Intentional addition / 1,000ppm	chemical products
10124	Selenium 70	19869-93-3	Contains (regardless of intentional or impurities)	chemical products
10125	(3-Methoxyphenyl)acetonitrile	19924-43-7	Contains (regardless of intentional or impurities)	chemical products
10126	Methanamine, N-methyl-, hafnium(4+) salt (4:1)	19962-11-9	Intentional addition / 1%	chemical products
10127	Ethanamine, N-ethyl-, hafnium(4+) salt (4:1)	19962-12-0	Intentional addition / 1%	chemical products
10128	Naphtho[2,1-b]furan-1(2H)-one	19987-42-3	Contains (regardless of intentional or impurities)	chemical products
10129	Bis(tricyclohexylphosphine)nickel(II) Dichloride	19989-87-2	Contains (regardless of intentional or impurities)	chemical products
10130	8-Oxa-3,5-dithia-4-stannaecisanoic acid, 4,4-dibutyl-7-oxo-, dodecyl ester	20004-12-0	Contains (regardless of intentional or impurities)	chemical products
10131	Benzene, 1-[(diiodomethyl)sulfonyl]-4-methyl-	20018-08-1	Intentional addition / 100ppm	chemical products
10132	Manganese oxide (MnO)	20033-08-3	Intentional addition / 1%	chemical products
10133	Dichlorobis(ethyleneimine)iridium perchlorate	20037-59-6	Intentional addition / 1,000ppm	chemical products
10134	1-Butene, 4-bromo-2-methyl-	20038-12-4	Intentional addition / 1,000ppm	chemical products
10135	Chromic acid (H2CrO4), compound with pyridine (1:2)	20039-37-6	Contains (regardless of intentional or impurities)	chemical products
10136	Strychnine, compound with methyl acetate (1:1)	20050-14-0	Contains (regardless of intentional or impurities)	chemical products
10137	5-(Diethylamino)-2-[(2-hydroxy-5-nitrophenyl)azo]phenol	20059-24-9	Intentional addition / 1%	chemical products
10138	Copper(2+) acrylate	20074-76-4	Intentional addition / 1,000ppm	chemical products
10139	Propane, 3,3-dibromo-1,1,1,2,2-pentafluoro-	20095-20-9	Intentional addition / 1,000ppm	chemical products
10140	Benzonitrile, 4-(2-bromoacetyl)-	20099-89-2	Intentional addition / 1%	chemical products
10141	N,N-Dimethyl-1,2-dithiolane-4-amine oxalate	20121-11-3	Intentional addition	chemical products
10142	1-Chloro-3-(1-naphthoxy)propan-2-ol	20133-93-1	Intentional addition / 1%	chemical products
10143	Fluorotriphenylstannane	20153-49-5	Contains (regardless of intentional or impurities)	chemical products
10144	Fluorotriethylstannane	20153-50-8	Contains (regardless of intentional or impurities)	chemical products
10145	1,4-Butanediol, 2,3-dibromo-	20163-90-0	Contains (regardless of intentional or impurities)	chemical products
10146	Iron(3+) heptadecanoate	20174-73-6	Intentional addition / 1%	chemical products
10147	2-Hydroxy-4-methyl-1,3,2-dioxaborolane	20190-34-5	Intentional addition / 1%	chemical products
10148	Octanoic acid, chromium salt	20195-23-7	Intentional addition / 1,000ppm	chemical products
10149	Chromic acid (H2CrO4), compound with cyclohexanamine (1:1)	20203-47-8	Contains (regardless of intentional or impurities)	chemical products
10150	Difluoromolybdenum (MoF2)	20205-60-1	Intentional addition / 1%	chemical products
10151	Boron phosphide (BP)	20205-91-8	Intentional addition / 1%	chemical products
10152	Strychnidin-10-one, compound with (OC-6-22)-tetrakis(acetato-O)(ethanedinitrilo-N,N')vanadate(1-)(1:1)	20219-29-8	Contains (regardless of intentional or impurities)	chemical products
10153	Barium styphnate	20236-55-9	Contains (regardless of intentional or impurities)	chemical products
10154	Boric acid (H3BO3), tris(decyl) ester	20236-81-1	Intentional addition / 1%	chemical products
10155	Copper(1+) oleate	20240-06-6	Intentional addition / 1,000ppm	chemical products
10156	Manganese(2+) myristate	20243-64-5	Contains (regardless of intentional or impurities)	chemical products
10157	Nickelate(2-), [(ethylenedinitrilo)tetraacetato]-, dihydrogen, monohydrate	20249-62-1	Contains (regardless of intentional or impurities)	chemical products
10158	Chlorous acid, copper(2+) salt	20255-20-3	Intentional addition / 1,000ppm	chemical products
10159	Stannane, dibutylbis[(3-carboxyacryloyl)-, bis(alpha-methylbenzyl) ester	20258-69-9	Intentional addition / 1,000ppm	chemical products
10160	Docosanoic acid, iron(3+) salt	20259-31-8	Intentional addition / 1%	chemical products
10161	Iron tripalmitate	20259-32-9	Intentional addition / 1%	chemical products
10162	Aluminum, 1-hexenylbis(2-methylpropyl)-, (E)-	20259-40-9	Intentional addition / 1,000ppm	chemical products
10163	Bicyclohexyl, 4-phenyl-	20273-27-2	Intentional addition / 1%	chemical products
10164	[1,1-Biphenyl]-4,4-bis(diazoniom), 3,3'-dimethoxy-	20282-70-6	Intentional addition / 30ppm	chemical products
10165	Trimethyl[2-(1-oxobutoxy)ethyl]ammonium perchlorate	20292-68-6	Intentional addition / 1,000ppm	chemical products
10166	Aniline sulphate	20305-50-4	Contains (regardless of intentional or impurities)	chemical products
10167	Carbonic acid, barium calcium salt	20313-52-4	Intentional addition / 1,000ppm	chemical products
10168	3,3'-Dimethoxybenzidine dihydrochloride	20325-40-0	Contains (regardless of intentional or impurities)	chemical products
10169	Strychnine, (2,4-di-tert-butyl-6-iodophenoxy)acetate, (-)-	20328-78-3	Contains (regardless of intentional or impurities)	chemical products
10170	Diphenylthioxostannane	20332-10-9	Contains (regardless of intentional or impurities)	chemical products
10171	Nicotine, mono(4-aminosalicylate)	20334-41-2	Contains (regardless of intentional or impurities)	chemical products
10172	Dimethyl ditelluride	20334-43-4	Contains (regardless of intentional or impurities)	chemical products
10173	Iron hydroxide oxide (Fe(OH)O)	20344-49-4	Intentional addition / 1%	chemical products
10174	Rubidium tetrahydroborate(1-)	20346-99-0	Intentional addition / 1%	chemical products
10175	Benzonitrile, 2-amino-3-chloro-5-nitro-	20352-84-5	Intentional addition	chemical products
10176	Tributyltin dimethylthiocarbamate	20369-83-5	Contains (regardless of intentional or impurities)	chemical products
10177	2-Chloro-1-fluoropropane	20372-78-5	Intentional addition	chemical products
10178	1,3,5-Triazine-2,4,6-tris(1H,3H,5H)-trione, 1-(oxiranylmethyl)-3,5-di-2-propenyl-	20395-16-8	Contains (regardless of intentional or impurities)	chemical products
10179	Ethanol, thallium(1+) salt	20398-06-5	Contains (regardless of intentional or impurities)	chemical products
10180	Copper(2+) O,O'-diisopropyl bis(dithiocarbonate)	20405-12-3	Intentional addition / 1,000ppm	chemical products
10181	Copper selenide (Cu2Se)	20405-64-5	Contains (regardless of intentional or impurities)	chemical products
10182	Acetic acid, fluoro-, copper(2+) salt	20424-95-7	Intentional addition / 1,000ppm	chemical products
10183	Cobalt(II) cyanide dihydrate	20427-11-6	Intentional addition / 1%	chemical products
10184	Copper hydroxide (Cu(OH)2)	20427-59-2	Contains (regardless of intentional or impurities)	chemical products
10185	(2E)-Penta-2,4-dienal	20432-40-0	Contains (regardless of intentional or impurities)	chemical products
10186	Strychnine, monopotassium tris(oxalato)chromate(3-)(1:2)	20436-53-7	Contains (regardless of intentional or impurities)	chemical products
10187	Nickel, [(1,1-[1,2-phenylenebis(nitro)methylidene]bis[2-naphthalenolato]](2-)-N,N',O,O']-, (SP-4-2)-	20437-10-9	Contains (regardless of intentional or impurities)	chemical products
10188	Dihydrogen [N,N-bis[2-bis(carboxymethyl)amino]ethyl]glycinato(5-)]ferrate(2-)	20438-93-1	Intentional addition / 1%	chemical products
10189	Triphenyl(pivaloyloxy)stannane	20451-90-5	Contains (regardless of intentional or impurities)	chemical products
10190	Nickel sulfamate	20467-91-8	Intentional addition / 1,000ppm	chemical products
10191	Hydrazinecarbothioic acid, compound with hydrazine (1:1)	20469-71-0	Contains (regardless of intentional or impurities)	chemical products
10192	Indium chloride (InCl3), trihydrate	20471-73-2	Intentional addition / 1%	chemical products
10193	Mixture of 1,5-dichloro-1,1,3,3,4,4,5,5-octafluoropentane-2-ol and 3,5-dichloro-1,1,1,3,4,4,5,5-octafluoropentane-2-ol and 1,5-dichloro-1,1,1,3,3,4,4,5,5-octafluoropentane-2-ol	20474-89-9	Contains (regardless of intentional or impurities)	chemical products
10194	Chromium, trioxobis(pyridine)-	20492-50-6	Contains (regardless of intentional or impurities)	chemical products
10195	Cobaltate(1-), bis[2-(3-chlorophenyl)-2-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with [1R-(1.alpha.,4.alpha.,10.alpha.)]-1,2,3,4,9a,10,10a-octahydro-1,4a-dimethyl-7-(1-methylethyl)-1-phenanthrenemethanamine (1:1)	20506-24-5	Intentional addition / 100ppm	chemical products
10196	Iron molybdenum oxide (Fe2MoO6)	20507-13-5	Intentional addition / 1%	chemical products
10197	Phosphoric acid, sodium zinc salt (1:1:1)	20539-12-2	Intentional addition / 25%	chemical products
10198	Nicotinic chloride, hydrochloride	20539-51-9	Contains (regardless of intentional or impurities)	chemical products
10199	Bis(p-chlorophenyl) diselenide	20541-49-5	Contains (regardless of intentional or impurities)	chemical products
10200	Iron orthoborate	20542-97-6	Intentional addition / 1%	chemical products
10201	Octanoic acid, copper salt	20543-04-8	Intentional addition / 1,000ppm	chemical products
10202	Oxalic acid, nickel salt	20543-06-0	Contains (regardless of intentional or impurities)	chemical products
10203	Stannane, dibutylbis[4-(1,1-dimethylethyl)benzoyloxy]-	20556-89-2	Contains (regardless of intentional or impurities)	chemical products
10204	Octadecanoic acid, copper(1+) salt	20563-00-2	Intentional addition / 1,000ppm	chemical products
10205	Ammonium mercuric thiocyanate	20564-21-0	Contains (regardless of intentional or impurities)	chemical products
10206	1,2-Benzenedicarboxylic acid, 3,4,5,6-tetrabromo-, 2-(2-hydroxyethoxy)ethyl 2-hydroxypropyl ester	20566-35-2	Intentional addition / 900ppm	chemical products
10207	Cadmium metaborate	20571-45-3	Contains (regardless of intentional or impurities)	chemical products
10208	Mercurate(2-), tetrachloro-, dipotassium, (T-4)-	20582-71-2	Contains (regardless of intentional or impurities)	chemical products
10209	1,2,3,3-Tetrachloropropene	20589-85-9	Intentional addition / 1,000ppm	chemical products
10210	Platinate(2-), hexabromo-, dihydrogen, (OC-6-11)-	20596-34-3	Contains (regardless of intentional or impurities)	chemical products
10211	Acetic acid, uranium(4+) zinc salt	20596-91-2	Contains (regardless of intentional or impurities)	chemical products
10212	Magnesium uranium(4+) hexaacetate	20596-93-4	Contains (regardless of intentional or impurities)	chemical products
10213	Nickel, (1-butylamine)[2,2'-thiois[4'-oxy]phenolato]](2-)-O,O'-S]-	20597-89-1	Contains (regardless of intentional or impurities)	chemical products
10214	2-Pentene, 1-bromo	20599-87-3	Intentional addition / 1,000ppm	chemical products
10215	Manganese chloride (MnCl2), dihydrate	20603-89-7	Contains (regardless of intentional or impurities)	chemical products
10216	Boron cerium(3+) trioxide	20620-87-5	Intentional addition / 1%	chemical products
10217	Nitricobaltanin	20623-13-6	Intentional addition / 1%	chemical products
10218	Tetraammineplatium dinitrate	20634-12-2	Contains (regardless of intentional or impurities)	chemical products
10219	Pentaethylene glycol 4-nonylphenyl ether	20636-48-0	Intentional addition / 1,000ppm	chemical products
10220	Hexacarbonylvanadate(1-)	20644-87-5	Intentional addition / 1%	chemical products
10221	Zirconium, bis(acetato-O,O')oxo-	20645-04-9	Contains (regardless of intentional or impurities)	chemical products
10222	Dipotassium tetrachlorocadmiate(2-)	20648-91-3	Contains (regardless of intentional or impurities)	chemical products
10223	Zinc cyanamidate	20654-08-4	Intentional addition / 25%	chemical products
10224	Copper cyanamidate	20654-09-5	Intentional addition / 1,000ppm	chemical products
10225	Borane-11B, trifluoro-	20654-88-0	Contains (regardless of intentional or impurities)	chemical products
10226	Indium hydroxide (In(OH)3)	20661-21-6	Intentional addition / 1%	chemical products
10227	Nitric acid, manganese(2+) salt, tetrahydrate	20694-39-7	Contains (regardless of intentional or impurities)	chemical products
10228	Phosphoric acid, indium salt (1:?)	20694-56-8	Intentional addition / 1,000ppm	chemical products
10229	3-Chlorophenylloxirane	20697-04-5	Contains (regardless of intentional or impurities)	chemical products
10230	Sulfuric acid, thallium(1+) zinc salt (2:2:1), hexahydrate	20712-47-4	Intentional addition / 1,000ppm	chemical products
10231	1,2-Dicarbododecaborane(12), 1-hexyl-	20740-05-0	Intentional addition / 1%	chemical products
10232	Dihydrogen hexaiodoplatinate	20740-45-8	Contains (regardless of intentional or impurities)	chemical products
10233	5-Hydroperoxy-5-methyl-1,2-dioxolan-3-one	20748-96-3	Contains (regardless of intentional or impurities)	chemical products
10234	Rhodium trichloride hydrate	20765-98-4	Contains (regardless of intentional or impurities)	chemical products
10235	Beryllium hydroxide (Be(OH)2)	20768-68-7	Contains (regardless of intentional or impurities)	chemical products
10236	Chromium hydroxide oxide (Cr(OH)O)	20770-05-2	Intentional addition / 1,000ppm	chemical products
10237	Nitroformic acid, compound with hydrazine (1:1)	20773-28-8	Contains (regardless of intentional or impurities)	chemical products
10238	3H-Pyrazol-3-one, 1,2-dihydro-1,5-dimethyl-2-phenyl-, monoperchlorate	20776-03-8	Intentional addition / 1,000ppm	chemical products
10239	Styrene, epoxy-, (R)-(+)-	20780-53-4	Intentional addition / 1%	chemical products
10240	Oxirane, phenyl-, (S)-	20780-54-5	Intentional addition / 1%	chemical products
10241	Boric acid (H3BO3), potassium salt	20786-60-1	Intentional addition / 1%	chemical products
10242	Rhodate(3-), hexakis(cyano-C)-, tripotassium, (OC-6-11)-	20792-40-9	Contains (regardless of intentional or impurities)	chemical products
10243	Osmium oxide (OsO4), (T-4)-	20816-12-0	Contains (regardless of intentional or impurities)	chemical products
10244	Daunomycin	20830-81-3	Contains (regardless of intentional or impurities)	chemical products
10245	Hydroxylammonium phosphate (3:1)	20845-01-6	Contains (regardless of intentional or impurities)	chemical products
10246	Hexanoic acid, 2-ethyl-, rhodium(3+) salt	20845-92-5	Contains (regardless of intentional or impurities)	chemical products
10247	Aluminum phosphide	20859-73-8	Contains (regardless of intentional or impurities)	chemical products
10248	Mesitylmercuric chloride	20883-32-3	Contains (regardless of intentional or impurities)	chemical products
10249	2-Thiopheneacetonitrile	20893-30-5	Intentional addition / 25%	chemical products
10250	Borane, chlorodiethoxy-	20905-32-2	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
10251	2,2-[Propane-1,3-diybis(oxo)]bis-1,3,2-dioxaborinane	20905-35-5	Intentional addition / 1%	chemical products
10252	2-Butenoic acid, 4-oxo-4-phenyl-, ethyl ester, (Z)-	20908-27-4	Contains (regardless of intentional or impurities)	chemical products
10253	Sulfuric acid, copper(2+) thallium(1+) salt (2:1:2), hexahydrate	20908-85-4	Intentional addition / 1%	chemical products
10254	Uranyl sulfate, trihydrate	20910-28-5	Contains (regardless of intentional or impurities)	chemical products
10255	Dimethylplumbium diacetate	20917-34-4	Contains (regardless of intentional or impurities)	chemical products
10256	4-Amino-2-chlorobenzonitrile	20925-27-3	Intentional addition	chemical products
10257	Salicylic acid, copper salt	20936-31-6	Intentional addition / 1,000ppm	chemical products
10258	Copper 2,4-dihydroxybenzoate	20936-33-8	Intentional addition / 1,000ppm	chemical products
10259	Tetrakis(diethylthiocarbamato-S,S')tellurium	20941-65-5	Contains (regardless of intentional or impurities)	chemical products
10260	Ferrate(3-), hexafluoro-, trisodium, (OC-6-11)-	20955-11-7	Intentional addition / 1%	chemical products
10261	Lithium permanganate trihydrate	20959-56-2	Contains (regardless of intentional or impurities)	chemical products
10262	Selenious acid, aluminum salt (3:2)	20960-77-4	Contains (regardless of intentional or impurities)	chemical products
10263	Heptanenitrile, 7-bromo-	20965-27-9	Intentional addition	chemical products
10264	Arsonium tetraphenyl- (hydrogen dichloride)	21006-79-5	Contains (regardless of intentional or impurities)	chemical products
10265	1-Benzopyrylium, 8-[5-[6,7-dihydro-6-methyl-2,4-diphenyl-5H-1-benzopyran-8-y]-2,4-pentadienylidene]-5,6,7,8-tetrahydro-6-methyl-2,4-diphenyl-, perchlorate	21016-19-3	Intentional addition / 1,000ppm	chemical products
10266	1-Benzopyrylium, 8-[5-[6,7-dihydro-2,4-bis[4-(pentyloxy)phenyl]-5H-1-benzopyran-8-y]-2,4-pentadienylidene]-5,6,7,8-tetrahydro-2,4-diphenyl-, perchlorate	21016-22-8	Intentional addition / 1,000ppm	chemical products
10267	1-Benzopyrylium, 5,6,7,8-tetrahydro-6-methyl-2,4-diphenyl-, perchlorate	21016-34-2	Intentional addition / 1,000ppm	chemical products
10268	1-Benzopyrylium, 5,6,7,8-tetrahydro-2,4-bis(p-pentyloxy)phenyl-, perchlorate	21016-35-3	Intentional addition / 1,000ppm	chemical products
10269	Phosphoric acid, barium titanium salt	21028-49-9	Intentional addition / 1,000ppm	chemical products
10270	Cobalt hydroxide	21041-93-0	Intentional addition / 1,000ppm	chemical products
10271	Mercurate(1-), (L-cysteinato(2-)-N,S)ethyl-, hydrogen	21082-50-8	Contains (regardless of intentional or impurities)	chemical products
10272	Metribuzin	21087-64-9	Contains (regardless of intentional or impurities)	chemical products
10273	Arsenic acid (H3AsO4), dipotassium salt	21093-83-4	Contains (regardless of intentional or impurities)	chemical products
10274	Sodium dihydrogen bis(heptonato(3-)-O3,O4)borate(3-)	21097-80-3	Intentional addition / 1%	chemical products
10275	Trimethylol, triester with boric acid, stereoisomer	21105-05-5	Intentional addition / 1%	chemical products
10276	Barium sulfide (BaS)	21109-95-5	Contains (regardless of intentional or impurities)	chemical products
10277	Manganese propionate	21129-18-0	Contains (regardless of intentional or impurities)	chemical products
10278	Plumbate(2-), [[N,N'-1,2-ethanediylbis[N-(carboxy-kappa.O)methylglycinato]](4-)-kappa.N,kappa.O]-, disodium, (OC-6-21)-	21135-97-7	Intentional addition	chemical products
10279	Benzenide sulfate	21136-70-9	Contains (regardless of intentional or impurities)	chemical products
10280	Methanesulfonic acid 3-(3-trifluoromethylphenyl)propyl ester	21172-43-0	Contains (regardless of intentional or impurities)	chemical products
10281	9-Octadecenoic acid (Z)-, chromium(3+) salt	21178-63-2	Intentional addition / 1,000ppm	chemical products
10282	Chromate(2-), [3-[(5-chloro-2-hydroxyphenyl)azo]-4-hydroxy-6-[[1-(oxo-2-propenyl)amino]-2-naphthalenesulfonato(3-)]][1-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, dihydrogen	21180-84-7	Contains (regardless of intentional or impurities)	chemical products
10283	Selenosemicarbazide	21198-79-8	Contains (regardless of intentional or impurities)	chemical products
10284	9-Borabicyclo[3.3.1]nonane, dimer	21205-91-4	Contains (regardless of intentional or impurities)	chemical products
10285	Copper bis(3,5-diisopropylsalicylate)	21246-18-4	Intentional addition / 1,000ppm	chemical products
10286	Manganese dialurate	21248-70-4	Contains (regardless of intentional or impurities)	chemical products
10287	Mercaptopurin sodium	21259-76-7	Contains (regardless of intentional or impurities)	chemical products
10288	Nickel(2+), bis(ethylenediamine)-, sulfate (1:1)	21264-77-7	Contains (regardless of intentional or impurities)	chemical products
10289	Triaminetrichlororhodium	21264-82-4	Contains (regardless of intentional or impurities)	chemical products
10290	Ferrate(1-), [[N,N'-1,2-ethanediylbis[N-(carboxymethylglycinato]](4-)-N,N'.O'.O'.ON,ON]-, ammonium, (OC-6-21)-	21265-50-9	Intentional addition / 1%	chemical products
10291	cis-2,5-Bis(chloromethyl)-1,4-dithiane	21273-22-3	Contains (regardless of intentional or impurities)	chemical products
10292	trans-2,5-Bis(chloromethyl)-1,4-dithiane	21273-46-1	Contains (regardless of intentional or impurities)	chemical products
10293	(E)-2,3-Dibromo-2-butene-1,4-diol	21285-46-1	Contains (regardless of intentional or impurities)	chemical products
10294	Phosphate(1-), hexafluoro-, lithium	21324-40-3	Contains (regardless of intentional or impurities)	chemical products
10295	Cadmium, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-1)-	21328-74-5	Contains (regardless of intentional or impurities)	chemical products
10296	4-(2-Naphthyl)-1,3-thiazole-2-amine	21331-43-1	Contains (regardless of intentional or impurities)	chemical products
10297	2-Chloro-3-(m-chloro-o-tolyl)propionitrile	21342-85-8	Intentional addition	chemical products
10298	Ethanedioic acid, niobium salt	21348-59-4	Intentional addition / 1,000ppm	chemical products
10299	Ethanedioic acid, tantalum salt	21348-60-7	Intentional addition / 1,000ppm	chemical products
10300	Cesium hydroxide	21351-79-1	Contains (regardless of intentional or impurities)	chemical products
10301	Zinc dichloride 3/2 hydrate	21351-91-7	Intentional addition / 1%	chemical products
10302	Zinc dichloride monohydrate	21351-92-8	Intentional addition / 1%	chemical products
10303	Rhodium(2+), pentaamminechloro-, (OC-6-22)-, sulfate (1:1)	21360-80-5	Contains (regardless of intentional or impurities)	chemical products
10304	(T-4)-Disodium tetrachloroedmate	21360-94-1	Intentional addition / 1,000ppm	chemical products
10305	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, monohydrochloride, (S)-	21361-93-3	Contains (regardless of intentional or impurities)	chemical products
10306	Boron, trifluoro(4-methylphenol)-, (T-4)-	21368-35-4	Intentional addition / 1%	chemical products
10307	2-Pentene, 1-bromo-3-ethyl-	21378-06-3	Intentional addition / 1,000ppm	chemical products
10308	Heptane, 4-(2-bromoethylidene)-2,6-dimethyl-	21378-12-1	Intentional addition / 1,000ppm	chemical products
10309	Ferrate(2-), [[N,N'-1,2-ethanediylbis[N-(carboxymethylglycinato]](4-)-N,N'.O'.O'.ON,ON]-, dihydrogen, (OC-6-21)-	21393-59-9	Intentional addition / 1%	chemical products
10310	Copper, [3-[[[2-hydroxyphenyl)methylene]amino][1,1'-biphenyl]-4-olato(2-)-N,O,O']-	21405-81-2	Intentional addition / 1,000ppm	chemical products
10311	Chromium, tris[2-hydroxy-3,5-bis(1-methylethyl)benzoato-O1,O2]-	21409-48-3	Intentional addition / 1,000ppm	chemical products
10312	Strychnine, compound with trans-mono-(2-hydroxyoctyloxy) phthalate (1:1), (-)	21423-08-5	Contains (regardless of intentional or impurities)	chemical products
10313	3-Chloro-p-toluenitrile	21423-81-4	Intentional addition	chemical products
10314	Argentate(1-), bis(cyano-O)-, sodium	21430-69-3	Contains (regardless of intentional or impurities)	chemical products
10315	Antimony chloride	21432-78-0	Contains (regardless of intentional or impurities)	chemical products
10316	2,4,5-Trimethylaniline hydrochloride	21436-97-5	Contains (regardless of intentional or impurities)	chemical products
10317	Bromotetraphenylantimony	21450-52-2	Contains (regardless of intentional or impurities)	chemical products
10318	Arsenic acid (H3AsO4), magnesium salt (2:3)	21480-65-9	Intentional addition / 1,000ppm	chemical products
10319	Oxobis(toluenep-sulphonato)vanadium	21493-51-6	Intentional addition / 1%	chemical products
10320	2,3-Difluorobenzonitrile	21524-39-0	Intentional addition	chemical products
10321	1,10-Phenanthroline, monoperchlorate	21532-74-1	Intentional addition / 1,000ppm	chemical products
10322	6-Chloromethyl-11H-dibenz[b,e]azepin	21535-44-4	Intentional addition / 1%	chemical products
10323	Silver sulfide (Ag2S)	21548-73-2	Intentional addition / 25%	chemical products
10324	Boron, hexafluoro[mu-(4,4'-methylenebis(benzenamine)-N,N')]di-	21555-99-7	Intentional addition / 1%	chemical products
10325	Selenium, bis(diethylcarbamodithioato-S)bis(diethylcarbamodithioato-S,S')-	21559-14-8	Contains (regardless of intentional or impurities)	chemical products
10326	Thiocyanic acid, (2-benzothiazolylthio)methyl ester	21564-17-0	Contains (regardless of intentional or impurities)	chemical products
10327	Boric acid (H3BO3), tripotassium salt	21581-60-2	Intentional addition / 1%	chemical products
10328	Nicotinic monovalate	21583-33-5	Contains (regardless of intentional or impurities)	chemical products
10329	Octadecanoic acid, 12-hydroxy-, barium salt (2:1)	21598-22-1	Intentional addition / 1,000ppm	chemical products
10330	Leptophos	21609-90-5	Contains (regardless of intentional or impurities)	chemical products
10331	3-(Hydroxymethyl)phenytoin	21616-46-6	Contains (regardless of intentional or impurities)	chemical products
10332	Stannane, diocetylbis(1-oxopropoxy)-	21619-67-0	Intentional addition / 1,000ppm	chemical products
10333	Ferrate(1-), aqua[[N,N'-1,2-ethanediylbis[N-(carboxymethylglycinato]](4-)-N,N'.O'.O'.ON,ON]-, sodium, (PB-7-11'-121'3'3)-	21626-24-4	Intentional addition / 1%	chemical products
10334	Tin oxide (SnO)	21651-19-4	Contains (regardless of intentional or impurities)	chemical products
10335	3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10-Heptadecafluorodec-1-ene	21652-58-4	Contains (regardless of intentional or impurities)	chemical products
10336	Rhodium trihydroxide	21656-02-0	Contains (regardless of intentional or impurities)	chemical products
10337	Diisopropyl cyanomethylphosphonate	21659-85-7	Intentional addition	chemical products
10338	2,5-Dichlorobenzonitrile	21663-61-6	Intentional addition	chemical products
10339	Barium bromide fluoride (BaBrF)	21669-04-5	Contains (regardless of intentional or impurities)	chemical products
10340	Chromium acetylacetonate	21679-31-2	Contains (regardless of intentional or impurities)	chemical products
10341	Cobalt, tris(2,4-pentanedionato-O,O')-, (OC-6-11)-	21679-46-9	Intentional addition / 1,000ppm	chemical products
10342	Sulfuric acid, nickel(2+) thallium(1+) salt (2:1:2), hexahydrate	21707-27-7	Intentional addition / 1,000ppm	chemical products
10343	Cyanazine	21725-46-2	Contains (regardless of intentional or impurities)	chemical products
10344	Plumbanediylum, dimethyl-	21774-13-0	Contains (regardless of intentional or impurities)	chemical products
10345	Nickel(2+) silicate	21784-78-1	Contains (regardless of intentional or impurities)	chemical products
10346	Tetrakis(acetonitrile)palladium(II) tetrafluoroborate	21797-13-7	Intentional addition / 1%	chemical products
10347	Strychnidin-10-one, sulfate	21800-13-5	Contains (regardless of intentional or impurities)	chemical products
10348	N-(p-Arsenosophenyl)-1,3,5-triazine-2,4,6-triamine	21840-08-4	Contains (regardless of intentional or impurities)	chemical products
10349	Bis(acryloyloxy)dibutylstannane	21843-46-9	Contains (regardless of intentional or impurities)	chemical products
10350	Benzene, 1,1'-(1-methylethylidene)bis(3,5-dibromo-4-(2,3-dibromopropoxy)-	21850-44-2	Contains (regardless of intentional or impurities)	chemical products
10351	Tellurium nitrate (Te(NO3)4)	21883-56-7	Contains (regardless of intentional or impurities)	chemical products
10352	Methylenebis(diphenylarsine)	21892-63-7	Contains (regardless of intentional or impurities)	chemical products
10353	Mercury oxide (HgO)	21908-53-2	Contains (regardless of intentional or impurities)	chemical products
10354	Butylodetin	21941-99-1	Intentional addition / 1,000ppm	chemical products
10355	Octane, 1,2-dichloro-	21948-46-9	Intentional addition / 1,000ppm	chemical products
10356	Ethyl 2-cyano-3,3-dimethylbutanoate	21954-81-4	Intentional addition	chemical products
10357	Hafnium(IV) chloride tetrahydrofuran complex (1:2)	21959-05-7	Intentional addition / 1%	chemical products
10358	3-Hexene, 2-bromo-	21964-20-5	Intentional addition / 1,000ppm	chemical products
10359	2-Hexene, 4-bromo-	21964-21-6	Intentional addition / 1,000ppm	chemical products
10360	3-Heptene, 5-bromo-	21964-22-7	Intentional addition / 1,000ppm	chemical products
10361	2-Pentene, 3-bromo-	21964-23-8	Intentional addition / 1,000ppm	chemical products
10362	2-Hexene, 3-bromo-	21971-88-0	Intentional addition / 1,000ppm	chemical products
10363	3-Hexene, 3-bromo-	21971-89-1	Intentional addition / 1,000ppm	chemical products
10364	3-Heptene, 4-bromo-	21971-90-4	Intentional addition / 1,000ppm	chemical products
10365	3-Hexene, 2-bromo-2,4-dimethyl-	21971-98-2	Intentional addition / 1,000ppm	chemical products
10366	2-Hexene, 4-bromo-2,4-dimethyl-	21971-99-3	Intentional addition / 1,000ppm	chemical products
10367	Pyridinium, 1-[2-chloro-1-(chloromethyl)ethyl]-, perchlorate	21981-30-6	Intentional addition / 1,000ppm	chemical products
10368	1,1,1,3,3-Pentachlorobutane	21981-33-9	Intentional addition / 1,000ppm	chemical products
10369	Stannane, dibutyl[[3-[[dibutyl[[2-carboxyethyl]thio]stanny]thio]propionyl]oxy]octyloxy-, octyl ester	21986-78-7	Contains (regardless of intentional or impurities)	chemical products
10370	Nickel, bis(acetoato-O)bis(1,2-ethanediamine-N,N')-	21996-43-0	Contains (regardless of intentional or impurities)	chemical products
10371	Piperazine-1,4-dicarbonyl	22005-33-0	Intentional addition	chemical products
10372	Benzenamine, 2-methyl-, dihydrochloride	22006-17-3	Intentional addition / 1,000ppm	chemical products
10373	2-Pentene, 4-bromo-2,4-dimethyl-	22074-61-9	Intentional addition / 1,000ppm	chemical products
10374	(±)-Nicotine	22083-74-5	Intentional addition / 1,000ppm	chemical products
10375	Nicotinic monomethiodide	22083-76-7	Contains (regardless of intentional or impurities)	chemical products
10376	Borane, chlorodipropyl-	22086-53-9	Intentional addition / 1%	chemical products
10377	Sulfuric acid, cobalt(2+) rubidium salt (2:1:2), hexahydrate	22088-57-9	Intentional addition / 1%	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
10378	Benzonitrile, 2-(bromomethyl)-	22115-41-9	Intentional addition	chemical products
10379	3-Heptene, 3-bromo-	22118-56-5	Intentional addition / 1,000ppm	chemical products
10380	2-Heptene, 4-bromo-	22118-57-6	Intentional addition / 1,000ppm	chemical products
10381	Diocetyl(bis(stearoxy)stannane	22205-26-1	Contains (regardless of intentional or impurities)	chemical products
10382	Stannane, bis(dodecylthio)dioctyl-	22205-30-7	Contains (regardless of intentional or impurities)	chemical products
10383	Copper(I) sulfide	22205-45-4	Intentional addition / 1,000ppm	chemical products
10384	Ethanedioic acid, europium(2+) salt (1:1)	22206-19-5	Intentional addition	chemical products
10385	Strychnine, (3-dibenzofuran)sulfinylacetate	22214-62-6	Contains (regardless of intentional or impurities)	chemical products
10386	Hexanoic acid, 2-ethyl-, copper salt	22221-10-9	Intentional addition / 1,000ppm	chemical products
10387	Fenamiphos	22224-92-6	Contains (regardless of intentional or impurities)	chemical products
10388	Ethanol, 2-amino-, diester with boric acid (H3BO3)	22232-01-5	Intentional addition / 1%	chemical products
10389	3-Amino-4-methylbenzeneboronic acid	22237-12-3	Intentional addition / 1%	chemical products
10390	4-Ethoxyphenylboronic acid	22237-13-4	Intentional addition / 1%	chemical products
10391	Tri-n-butyl borate	22238-17-1	Intentional addition / 1%	chemical products
10392	Ethanol, 2-chloro-, triester with boric acid (H3BO3)	22238-19-3	Intentional addition / 1%	chemical products
10393	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, iron(2+) salt (1:1)	22242-53-1	Intentional addition / 1%	chemical products
10394	Benzo[thiazolium, 3-ethyl-2-[3-(3-ethyl-2(3H)-benzothiazolylidene)-1,3,5-heptatrienyl]-, perchlorate	22268-86-2	Intentional addition / 1,000ppm	chemical products
10395	beta.-Chloro-N-(2-chloroethyl)-N-methylphenethylamine	22270-22-0	Intentional addition / 1%	chemical products
10396	Benzenediazonium, 3-chloro-4-(diethylamino)-, tetrafluoroborate(1-)	22276-83-7	Intentional addition / 1%	chemical products
10397	Boron, trifluoro(2-methylphenol), (T-4)-	22293-00-1	Intentional addition / 1%	chemical products
10398	Pentane, 1-bromo-3-methyl-, (S)-	22299-70-3	Intentional addition / 1,000ppm	chemical products
10399	Barium chloride (BaCl2), monohydrate	22322-71-0	Intentional addition / 1,000ppm	chemical products
10400	Barium hydroxide, monohydrate	22326-55-2	Contains (regardless of intentional or impurities)	chemical products
10401	Bis(tributyltin) salicylate	22330-14-9	Contains (regardless of intentional or impurities)	chemical products
10402	Potassium triiodomercurate(1-)	22330-18-3	Contains (regardless of intentional or impurities)	chemical products
10403	o-Tolylacetonitrile	22364-68-7	Contains (regardless of intentional or impurities)	chemical products
10404	Monensin, monosodium salt	22373-78-0	Intentional addition / 8%	chemical products
10405	Boric acid (H3BO3), calcium salt (2:1)	22379-77-7	Intentional addition / 1%	chemical products
10406	Indium phosphide	22398-80-7	Contains (regardless of intentional or impurities)	chemical products
10407	Nitric acid, manganese(3+) salt	22405-70-5	Contains (regardless of intentional or impurities)	chemical products
10408	Hafnium-tetra-n-butoxide	22411-22-9	Contains (regardless of intentional or impurities)	chemical products
10409	Arsenic pentachloride	22441-45-8	Contains (regardless of intentional or impurities)	chemical products
10410	Hydrogen bis(salicylate(2-)-O1,O2)borate(1-)	22450-97-1	Intentional addition / 1%	chemical products
10411	Borate(1-), bis[1,2-benzenediolato(2-)-O,O']-, hydrogen, (T-4)-	22450-98-2	Intentional addition / 1%	chemical products
10412	Sulfuric acid, nickel(2+) rubidium salt (2:1:2), hexahydrate	22451-23-6	Contains (regardless of intentional or impurities)	chemical products
10413	Glyceric acid 3-(barium phosphate)	22457-55-2	Contains (regardless of intentional or impurities)	chemical products
10414	Hexanoic acid, 2-ethyl-, zirconium salt (1:?)	22464-99-9	Contains (regardless of intentional or impurities)	chemical products
10415	Cadmium sulfate, octahydrate	22465-18-5	Contains (regardless of intentional or impurities)	chemical products
10416	Acetocobaltamin	22465-48-1	Intentional addition / 1%	chemical products
10417	Bis(octadecanoato-O)oxozirconium	22473-71-8	Contains (regardless of intentional or impurities)	chemical products
10418	[mu-([1,1',1'']-Benzene-1,2,4,5-tetratetrakis(nitromethylidene)naphth-2-olato(4-))]dinickel	22484-07-7	Contains (regardless of intentional or impurities)	chemical products
10419	2-Methyl-4-cyanoethylphenol	22516-99-0	Intentional addition	chemical products
10420	3,8,10-Trioxa-9-stannatetradeca-5,12-dien-14-oiic acid, 9,9-dibutyl-2-methyl-4,7,11-trioxo-, 1-methylethyl ester, (Z,Z)-	22535-42-8	Contains (regardless of intentional or impurities)	chemical products
10421	Dimethyltin maleate	22535-43-9	Intentional addition / 1,000ppm	chemical products
10422	Barium mercaptoacetate	22535-45-1	Intentional addition / 1,000ppm	chemical products
10423	Beryllium ion (Be2+)	22537-20-8	Contains (regardless of intentional or impurities)	chemical products
10424	Triarsenic acid	22538-92-7	Intentional addition / 1,000ppm	chemical products
10425	Chromium(II)	22541-79-3	Contains (regardless of intentional or impurities)	chemical products
10426	Lithium triethylhydroborate	22560-16-3	Intentional addition / 1%	chemical products
10427	Potassium triethylhydroborate	22560-21-0	Intentional addition / 1%	chemical products
10428	Barium di-D-glucuronate	22561-74-6	Contains (regardless of intentional or impurities)	chemical products
10429	Bis(2-ethylhexanoato-O)-mu-oxodioxidizirconium	22569-47-7	Contains (regardless of intentional or impurities)	chemical products
10430	Acetamide, N-[2-(2-bromo-4,6-dinitrophenyl)azo]-5-[(2-cyanoethyl)ethylamino]-4-methoxyphenyl-	22578-88-5	Contains (regardless of intentional or impurities)	chemical products
10431	1-Cyanopropane-1-enyl acetate	22581-05-1	Intentional addition	chemical products
10432	Cobalt bromide (CoBr)	22584-72-1	Intentional addition / 1%	chemical products
10433	2-Pentene, 1-chloro-	22592-15-0	Contains (regardless of intentional or impurities)	chemical products
10434	Citric acid, nickel salt	22605-92-1	Contains (regardless of intentional or impurities)	chemical products
10435	Hydroxylamine, acetate	22608-42-4	Intentional addition / 1%	chemical products
10436	Arsenic selenide (AsSe2)	22626-92-2	Contains (regardless of intentional or impurities)	chemical products
10437	1-Nitroso-2-naphthol cobalt salt	22631-85-8	Intentional addition / 1%	chemical products
10438	Boron, trifluoro(3-methylphenol)-, (T-4)-	22637-20-3	Intentional addition / 1%	chemical products
10439	Magnesium molybdenum oxide (Mg2Mo3O11)	22648-09-5	Intentional addition / 1%	chemical products
10440	Propane, 2-bromo-1,1,1,3,3-pentafluoro-	22692-16-6	Intentional addition / 1,000ppm	chemical products
10441	Propane, 1,2-dibromo-1,1,3,3-tetrafluoro-	22692-17-7	Intentional addition / 1,000ppm	chemical products
10442	Boric acid (H3BO3), triammonium salt	22694-75-3	Intentional addition / 1%	chemical products
10443	4,4-Dibutyl-1,3-dioxo-2-thia-4-stannacyclobutane 2,2-dioxide	22709-76-8	Contains (regardless of intentional or impurities)	chemical products
10444	1,3,2,4-Dioxathiasannetane, 4,4-dibutyl-, 2-oxide	22709-77-9	Intentional addition / 1,000ppm	chemical products
10445	Aluminate(1-), dihydrobis(2-methoxyethanolato-O,O')-, sodium	22722-98-1	Intentional addition / 1%	chemical products
10446	Strychnine, mono(6-hydroxy-2-naphthalenesulfonate)	22725-06-0	Contains (regardless of intentional or impurities)	chemical products
10447	Strychnine, mono(6-hydroxy-2-naphthalenesulfonate) benzenesulfonate(ester)	22733-74-0	Contains (regardless of intentional or impurities)	chemical products
10448	Cyclopent-1-ene-1-acetonitrile	22734-04-9	Intentional addition	chemical products
10449	Arsenic selenide (AsSe3)	22739-14-6	Contains (regardless of intentional or impurities)	chemical products
10450	Cadmium chlorate dihydrate	22750-54-5	Contains (regardless of intentional or impurities)	chemical products
10451	Cesium azide	22750-57-8	Contains (regardless of intentional or impurities)	chemical products
10452	Ethyl perchlorate	22750-93-2	Intentional addition / 1,000ppm	chemical products
10453	m-Nitrobenzene diazonium perchlorate	22751-24-2	Intentional addition / 1,000ppm	chemical products
10454	Zinc dinitrate 7/2 hydrate	22763-46-8	Intentional addition / 1%	chemical products
10455	Manganese phosphonate	22775-65-1	Contains (regardless of intentional or impurities)	chemical products
10456	Bendiocarb	22781-23-3	Contains (regardless of intentional or impurities)	chemical products
10457	Citric acid, zirconium salt	22830-18-8	Contains (regardless of intentional or impurities)	chemical products
10458	Gluconic acid, iron(II) salt, hydrate (2:1:2)	22830-45-1	Intentional addition / 1%	chemical products
10459	Aluminum arsenide (AlAs)	22831-42-1	Contains (regardless of intentional or impurities)	chemical products
10460	Cobaltate(6-), decakis(cyano-C)d-, (Co-Co), hexapotassium	22853-45-8	Intentional addition / 1%	chemical products
10461	2,3-Naphthalene dicarbonitrile	22856-30-0	Intentional addition	chemical products
10462	Zirconium, (hydrogen sulfato)oxo-, trihydrate	22866-75-5	Contains (regardless of intentional or impurities)	chemical products
10463	5'-Adenosinetriphosphoric acid dibarium salt	22867-44-1	Intentional addition	chemical products
10464	Phenylmercuric formamide	22894-47-9	Contains (regardless of intentional or impurities)	chemical products
10465	Molybdenum zinc oxide (Mo2Zn3O9)	22914-58-5	Contains (regardless of intentional or impurities)	chemical products
10466	Trihydrogen [3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]-[4-hydroxy-3-(2-hydroxy-5-nitrophenyl)azo]-6-(toluene-p-sulphonamido)naphthalene-2-sulphonato(3-)]chromate(3-)	22967-36-8	Contains (regardless of intentional or impurities)	chemical products
10467	L-Ascorbic acid, iron salt	22967-42-6	Intentional addition / 1%	chemical products
10468	3-Hydroxy-2-naphthohydroxamic acid	22974-74-9	Contains (regardless of intentional or impurities)	chemical products
10469	Copper palmitate	22992-96-7	Intentional addition / 1,000ppm	chemical products
10470	Rhodium chloride (RhCl)	23043-90-5	Intentional addition / 1%	chemical products
10471	alpha, alpha-Dichloro-p-xylene	23063-36-7	Contains (regardless of intentional or impurities)	chemical products
10472	Ammonium, benzoldodecylbis(2-hydroxyethyl)-, salt with pentachlorophenol (1:1)	23063-51-6	Contains (regardless of intentional or impurities)	chemical products
10473	cis-3-Bromo-2-pentene	23068-94-2	Intentional addition / 1,000ppm	chemical products
10474	2-Pentene, 4-bromo-, (E)-	23068-95-3	Intentional addition / 1,000ppm	chemical products
10475	Manoocetyltriiodide	23072-08-4	Intentional addition / 1,000ppm	chemical products
10476	1-Butene, 2-bromo-	23074-36-4	Intentional addition / 1,000ppm	chemical products
10477	2-Pentene, 3-bromo-2,4-dimethyl-	23074-38-6	Intentional addition / 1,000ppm	chemical products
10478	Tricyclo[3.3.1.1.3,7]decane-1-carbonitrile	23074-42-2	Contains (regardless of intentional or impurities)	chemical products
10479	1-(2-Chloro-5-nitrophenyl)ethan-1-one	23082-50-0	Intentional addition / 1%	chemical products
10480	Acetic acid, uranium salt	23086-58-0	Intentional addition / 1,000ppm	chemical products
10481	Acetic acid, ammonium copper salt	23087-46-9	Intentional addition / 1,000ppm	chemical products
10482	Pirimicarb	23103-98-2	Contains (regardless of intentional or impurities)	chemical products
10483	2,6-Dimethoxybenzeneboronic acid	23112-96-1	Intentional addition / 1%	chemical products
10484	Dimethyltin	23120-99-2	Intentional addition / 1,000ppm	chemical products
10485	Oxamyf	23135-22-0	Contains (regardless of intentional or impurities)	chemical products
10486	Thiosulfuric acid (H2S2O3), disilver(1+) salt	23149-52-2	Intentional addition / 25%	chemical products
10487	1-Tetradecanol, triester with boric acid (H3BO3)	23162-15-4	Intentional addition / 1%	chemical products
10488	1H-Benz[e]indolium, 2-[7-(1,3-dihydro-1,3-trimethyl-2H-benz[e]indol-2-ylidene)-1,3,5-heptatrienyl]-, 1,1,3-trimethyl-, perchlorate	23178-67-8	Intentional addition / 1,000ppm	chemical products
10489	Strychnine, mono[(+)-[(7-bromo-1-naphthyl)sulfinyl]acetate], (+)-	23181-49-9	Contains (regardless of intentional or impurities)	chemical products
10490	N-(Butoxymethyl)-2-chloro-2,6'-diethylacetanilide	23184-66-9	Intentional addition / 1%	chemical products
10491	3-Methylbutyl (2,4,5-trichlorophenoxy)acetate	23197-61-7	Intentional addition / 1,000ppm	chemical products
10492	Hexa(cyano-c)cobaltate(4-)	23209-26-9	Contains (regardless of intentional or impurities)	chemical products
10493	Nickel dinitrate dihydrate	23232-50-0	Contains (regardless of intentional or impurities)	chemical products
10494	9-Octadecenoic acid (Z)-, manganese(2+) salt	23250-73-9	Contains (regardless of intentional or impurities)	chemical products
10495	Hydrazine, dihydrobromide	23268-00-0	Contains (regardless of intentional or impurities)	chemical products
10496	Cobalt palmitate	23272-52-8	Intentional addition / 1%	chemical products
10497	Nicotine ethiodide	23277-52-3	Contains (regardless of intentional or impurities)	chemical products
10498	Stannane, (4-oxovaleryloxy)triphenyl-	23292-85-5	Contains (regardless of intentional or impurities)	chemical products
10499	Chloro(pyridine)bis(dimethylglyoximate)cobalt(III)	23295-32-1	Intentional addition / 1%	chemical products
10500	(+)-[3-Cyano-3-(3,4-dimethoxyphenyl)hex-6-yl][5,6-dimethoxyphenyl)methylammonium chloride	23313-68-0	Intentional addition	chemical products
10501	Bis(2-acetoxybenzoato)copper	23325-63-5	Intentional addition / 1,000ppm	chemical products
10502	9-Octadecenoic acid (Z)-, iron salt	23335-74-2	Intentional addition / 1%	chemical products
10503	Hexadecanoic acid, zirconium(4+) salt (4:1)	23337-55-5	Contains (regardless of intentional or impurities)	chemical products
10504	Chloroxyborane	23361-55-9	Intentional addition / 1%	chemical products
10505	Fluoroxylborane	23361-56-0	Intentional addition / 1%	chemical products
10506	Acetic acid, yttrium(3+) salt	23363-14-6	Intentional addition / 1%	chemical products
10507	Magnesium chromate hydrate	23371-94-0	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
10508	Citric acid, iron(2+) salt	23383-11-1	Intentional addition / 1%	chemical products
10509	Cobalt benzenesulfonate	23384-69-2	Intentional addition / 1%	chemical products
10510	Bis(dibutylidithiocarbamate-S,S')iron	23408-95-9	Intentional addition / 1%	chemical products
10511	Hexadecanoic acid, barium salt	23410-25-5	Intentional addition / 1,000ppm	chemical products
10512	Zinc permanganate	23414-72-4	Contains (regardless of intentional or impurities)	chemical products
10513	Orthoboric acid, barium salt	23436-05-7	Contains (regardless of intentional or impurities)	chemical products
10514	Hydrazine, phosphate	23488-13-3	Contains (regardless of intentional or impurities)	chemical products
10515	Pyrimiphos-ethyl	23505-41-1	Contains (regardless of intentional or impurities)	chemical products
10516	Ricinoleic acid, tin salt	23507-57-5	Intentional addition / 1,000ppm	chemical products
10517	Borate(1-), bis[2,3-naphthalenediolato(2-)-O,O']-, (T-4)-, hydrogen, compound with N-(1-methylethyl)-2-propanamine (1:1)	23507-71-3	Intentional addition / 1%	chemical products
10518	Di-n-octyltin dibenzoate	23519-66-6	Intentional addition / 1,000ppm	chemical products
10519	1-Propanol, zirconium(4+) salt	23519-77-9	Contains (regardless of intentional or impurities)	chemical products
10520	Diphenylarsinecarbonitrile	23525-22-6	Contains (regardless of intentional or impurities)	chemical products
10521	9-Butyl-9-borabicyclo[3.3.1]nonane	23532-74-3	Intentional addition / 1%	chemical products
10522	Barium N-formimidoyl-L-glutamate (1:2)	23541-42-6	Contains (regardless of intentional or impurities)	chemical products
10523	Thiophanate-methyl	23564-05-8	Contains (regardless of intentional or impurities)	chemical products
10524	Carbonic acid, potassium zirconium salt	23570-56-1	Contains (regardless of intentional or impurities)	chemical products
10525	Bis[2-(diphenylarsinoethyl)phenyl]phosphine	23582-05-0	Contains (regardless of intentional or impurities)	chemical products
10526	[2-(Diphenylarsino)ethyl]diphenylphosphine	23582-06-1	Contains (regardless of intentional or impurities)	chemical products
10527	Acetic acid, trifluoro-, thallium(3+) salt	23586-53-0	Contains (regardless of intentional or impurities)	chemical products
10528	Barium cinnamate	23588-87-6	Contains (regardless of intentional or impurities)	chemical products
10529	Iron(2+), tris(5-methyl-1,10-phenanthroline-N1,N10)-, sulfate (1:1)	23606-37-3	Intentional addition / 1%	chemical products
10530	Strychnine, compound with O,O,S-trimethyl phosphorodithioate (1:1)	23637-34-5	Contains (regardless of intentional or impurities)	chemical products
10531	Copper, tetrakis[μ-(2-(acetoxybenzoato-O1,O1')di-, (Cu-Cu)]	23642-01-5	Intentional addition / 1,000ppm	chemical products
10532	Tributylthiocyanatostannane	23654-14-0	Contains (regardless of intentional or impurities)	chemical products
10533	Trihydrogen [5-acetamido-4-hydroxy-3-[[2-hydroxy-5-methyl-4-[[2-(sulphoxy)ethyl]sulfonyl]phenyl]azo]naphthalene-2,7-disulphonato(3-)]cuprate(3-)	23658-53-9	Intentional addition / 1,000ppm	chemical products
10534	Copper, [dihydrogen 5-acetamido-4-hydroxy-3-[[2-hydroxy-4-[[2-hydroxyethyl]sulfonyl]-5-methoxyphenyl]azo]-2,7-naphthalenedisulfonato(2-)]-, mono(hydrogen sulfate) (ester)	23658-54-0	Intentional addition / 1,000ppm	chemical products
10535	Strychnine, mono[[2-(phenanthrylsulfonyl)acetate], (-)]	23660-44-8	Contains (regardless of intentional or impurities)	chemical products
10536	Cobalt chloride	23670-59-9	Intentional addition / 1%	chemical products
10537	Iron(2+), tris(5-nitro-1,10-phenanthroline-N1,N10)-, sulfate (1:1)	23700-19-8	Intentional addition / 1%	chemical products
10538	Ethyl tributyltin sulfide	23716-85-0	Intentional addition / 1,000ppm	chemical products
10539	Potassium fluoroacetate	23745-86-0	Contains (regardless of intentional or impurities)	chemical products
10540	7H-Benzimidazo[2,1-a]benz[de]isoquinolin-7-one	23749-58-8	Contains (regardless of intentional or impurities)	chemical products
10541	Nicotine, oxalate	23758-42-1	Contains (regardless of intentional or impurities)	chemical products
10542	Nicotine gentisic acid salt	23758-43-2	Contains (regardless of intentional or impurities)	chemical products
10543	Hexaborane	23777-80-2	Intentional addition / 1%	chemical products
10544	Stannane, butyltris[(2-ethyl-1-oxohexyloxy)-]	23850-94-4	Contains (regardless of intentional or impurities)	chemical products
10545	2,2'-Bis(4-octylpheno)monosulfide nickel complex	23852-73-5	Contains (regardless of intentional or impurities)	chemical products
10546	Hydrogen pentafluoro(fluorosulphato-O)antimonate(1-)	23854-38-8	Contains (regardless of intentional or impurities)	chemical products
10547	9-[2-Carboxyphenyl]-3,6-bis(diethylamino)xanthylum perchlorate	23857-51-4	Intentional addition / 1,000ppm	chemical products
10548	Xanthylum, 3,6-bis(diethylamino)-9-[2-(ethoxycarbonyl)phenyl]-, perchlorate	23857-69-4	Intentional addition / 1,000ppm	chemical products
10549	Diarsenic	23878-46-8	Contains (regardless of intentional or impurities)	chemical products
10550	Dibutyl(dichloro)plumbane	23884-79-9	Intentional addition / 1,000ppm	chemical products
10551	1-(Bromomethyl)-2,4-difluorobenzene	23915-07-3	Contains (regardless of intentional or impurities)	chemical products
10552	Succinonitrile-D4	23923-29-7	Intentional addition	chemical products
10553	Pentasodium 2-(2-oxido-3,5-disulphonatophenoxy)-1,3,2-benzodioxastibole-4,6-disulphonate	23940-36-5	Contains (regardless of intentional or impurities)	chemical products
10554	Zirconium, tetrakis(ethyl 3-oxobutanoato-O1,O3)-	23940-69-4	Contains (regardless of intentional or impurities)	chemical products
10555	Cobalt(1+), [N,N-bis(2-aminoethyl)-1,2-ethanediamine-N,N,N',N'] [carbonato(2-)-O,O']-, perchlorate	23949-78-2	Intentional addition / 1%	chemical products
10556	Pronamide	23950-58-5	Contains (regardless of intentional or impurities)	chemical products
10557	Copper, [1,3,8,10,15,17,22,24-octachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-cuprate(3-), [3-(hydroxy-kappa O)-4-[[2-(hydroxy-kappa O)-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo-kappa N1]-2,7-naphthalenedisulfonato(5-)]-, trihydrogen	23970-06-1	Intentional addition / 1,000ppm	chemical products
10558	Cuprate(3-), [3-(hydroxy-kappa O)-4-[[2-(hydroxy-kappa O)-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo-kappa N1]-2,7-naphthalenedisulfonato(5-)]-, trihydrogen	23970-24-3	Intentional addition / 1,000ppm	chemical products
10559	1H-Imidazole-1-propanenitrile, 2-phenyl-	23996-12-5	Intentional addition	chemical products
10560	1H-Imidazole-1-propanenitrile, 2-undecyl-	23996-16-9	Intentional addition	chemical products
10561	1H-Imidazole-1-propanenitrile, 2-ethyl-4-methyl-	23996-25-0	Intentional addition	chemical products
10562	Carbonic acid, ammonium zinc salt	24012-08-6	Intentional addition / 25%	chemical products
10563	Strychnine, thiosulfate (2:1)	24046-61-5	Contains (regardless of intentional or impurities)	chemical products
10564	4-Nitrophenylboronic acid	24067-17-2	Intentional addition / 1%	chemical products
10565	Chromium nitride (CrN)	24094-93-7	Intentional addition / 1,000ppm	chemical products
10566	Copper, [3,7,11,15-tetramethyl-2-hexadecyl-9-ethenyl-14-ethyl-13-formyl-21-(methoxycarbonyl)-4,8,18-trimethyl-20-oxo-3-phorbinoopanoato(2-)-N23,N24,N25,N26]-, [SP-4-2-[3S-[3.alpha.(2E,7S*,11S*)4.beta.21.beta.]]]	24111-17-9	Intentional addition / 1,000ppm	chemical products
10567	Tributyltin linoleate	24124-25-2	Contains (regardless of intentional or impurities)	chemical products
10568	Nickelate(4-), hexakis(cyano-kappa C)-, tetrapotassium, (OC-6-11)-	24151-25-5	Contains (regardless of intentional or impurities)	chemical products
10569	4-[[2-(Acetoxy)ethyl](phenylmethyl)amino]-2-chloro-5-(2-methoxyethoxy)benzenediazonium tetrafluoroborate	24151-54-0	Intentional addition / 1%	chemical products
10570	Piperophos	24151-93-7	Contains (regardless of intentional or impurities)	chemical products
10571	Naphthalene, 1,4-bis(1-methylethyl)-	24157-79-7	Intentional addition / 1%	chemical products
10572	Naphthalene, 2,6-bis(1-methylethyl)-	24157-81-1	Intentional addition / 1%	chemical products
10573	Naphthalene, 1,8-bis(1-methylethyl)-	24192-58-3	Intentional addition / 1%	chemical products
10574	Di-μ-carbonyltetracarbonylbis(triphenylphosphine)dichalcogen	24212-54-2	Intentional addition / 1,000ppm	chemical products
10575	Sodium bis[4-(4-chloro-1-hydroxy-2-naphthyl)azo]-N,N-diethyl-5-hydroxybenzene-1,3-disulphonamidato(2-)]cobaltate(1-)	24215-94-9	Intentional addition / 1,000ppm	chemical products
10576	3-Heptene, 1-bromo-4-methyl-	24230-12-4	Intentional addition / 1,000ppm	chemical products
10577	Hexadecane, 7-bromo-5-ethyl-7-methyl-	24251-91-0	Intentional addition / 1,000ppm	chemical products
10578	Chromium, triqua[hydrogen 3-hydroxy-4-[[5-hydroxy-3-methyl-1-(m-sulfo)phenyl]pyrazol-4-yl]azo]-1-naphthalenesulfonato(3-)]-, monosodium salt	24256-56-2	Contains (regardless of intentional or impurities)	chemical products
10579	Tris(octan-1-olato)oxovanadium	24261-23-2	Intentional addition / 1%	chemical products
10580	Nickel telluride	24270-51-7	Contains (regardless of intentional or impurities)	chemical products
10581	[Isopropylidenebis(p-phenyleneoxy)]bis(tributylstannane)	24291-51-8	Contains (regardless of intentional or impurities)	chemical products
10582	4-Octene, 4-bromo-, (E)-	24291-80-3	Intentional addition / 1,000ppm	chemical products
10583	4-Octene, 4-bromo-, (Z)-	24291-81-4	Intentional addition / 1,000ppm	chemical products
10584	Chromate(1-), bis[N-[8-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]acetamidato(2-)]-, sodium	24305-97-3	Contains (regardless of intentional or impurities)	chemical products
10585	Acetamide, N-(p-bromobenzyl)-2-fluoro-	24312-44-5	Intentional addition	chemical products
10586	D-Ribofuranose, 5-(dihydrogen phosphate), barium salt	24325-23-3	Contains (regardless of intentional or impurities)	chemical products
10587	Cadmium methacrylate	24345-60-6	Contains (regardless of intentional or impurities)	chemical products
10588	1,4-Diazobutane	24345-72-0	Intentional addition / 1%	chemical products
10589	Tetrabenzylzirconium	24356-01-2	Contains (regardless of intentional or impurities)	chemical products
10590	Barium isopropoxide	24363-97-9	Intentional addition	chemical products
10591	Barium pentacyanonitrosylferrate(III)	24378-32-3	Intentional addition	chemical products
10592	Triphenylsallyloyloxystannane	24379-26-8	Contains (regardless of intentional or impurities)	chemical products
10593	2-Desene, 1-bromo-, (Z)-	24380-91-4	Intentional addition / 1,000ppm	chemical products
10594	Phenylboronic acid pinacol ester	24388-23-6	Intentional addition / 1%	chemical products
10595	D-Glucitol, compound with iron(3+) citrate	24390-15-6	Intentional addition / 1%	chemical products
10596	5,7,12,14-Tetraoxa-6,13-distannaoctadeca-2,9,16-trieneedioic acid, 6,6,13,13-tetraoctyl-4,8,11,15-tetraoxo-, diethyl ester, (Z,Z,Z)-	24396-70-1	Intentional addition / 1,000ppm	chemical products
10597	2-Nonene, 2-bromo-, (Z)-	24404-60-2	Intentional addition / 1,000ppm	chemical products
10598	Ammonium iron tetrachloride	24411-12-9	Intentional addition / 1%	chemical products
10599	3-Bromo-2-nitrothiophene	24430-27-1	Contains (regardless of intentional or impurities)	chemical products
10600	1H-Pyrrole-2-acetonitrile, 1-methyl-	24437-41-0	Intentional addition	chemical products
10601	Copper, chloro[tris(2-chloroethyl) phosphite-P]	24484-01-3	Contains (regardless of intentional or impurities)	chemical products
10602	cis-2-Chloro-9-(3-dimethylaminopropylidene)selenoxanthene hydrochloride	24493-83-2	Contains (regardless of intentional or impurities)	chemical products
10603	(3E)-3-(2-Chloro-9H-selenoxanthene-9-ylidene)-N,N-dimethyl-1-propanamine hydrochloride (1:1)	24493-84-3	Contains (regardless of intentional or impurities)	chemical products
10604	8-Chloro-10-(4-methylpiperazino)-10,11-dihydrodibenzo(b,f)selenenyl maleate	24495-43-0	Contains (regardless of intentional or impurities)	chemical products
10605	Piperazine, 1-(8-chloro-10,11-dihydrodibenzo(b,f)selenenyl-10-yl)-2-methyl-	24495-59-8	Contains (regardless of intentional or impurities)	chemical products
10606	1-Naphthalenesulfonic acid, 2-[[2-(hydroxy-1-naphthalenyl)azo]-], barium salt (1:1)	24530-53-8	Contains (regardless of intentional or impurities)	chemical products
10607	Barium divalerate	24557-04-8	Contains (regardless of intentional or impurities)	chemical products
10608	Benzenediazonium, 4-(dimethylamino)-, tetrafluoroborate(1-)	24564-52-1	Intentional addition / 1%	chemical products
10609	Bis[2-(ethyl-1-oxohexyloxy)diethylstannane]	24577-34-2	Contains (regardless of intentional or impurities)	chemical products
10610	Nicotine, pivalate	24580-89-0	Contains (regardless of intentional or impurities)	chemical products
10611	1-Methoxypropan-2-yl methanesulfonate	24590-51-0	Contains (regardless of intentional or impurities)	chemical products
10612	Morpholine, 2,6-dimethyl-4-tridecyl-	24602-86-6	Contains (regardless of intentional or impurities)	chemical products
10613	Dipotassium zinc diphosphate	24606-42-6	Intentional addition / 25%	chemical products
10614	Antimony chloride fluoride (SbCl3F2)	24626-20-8	Contains (regardless of intentional or impurities)	chemical products
10615	1,4-Benzenediamine, N,N-dimethyl-, ethanedioate (1:1)	24631-29-6	Contains (regardless of intentional or impurities)	chemical products
10616	2,4-Hexadienoic acid, potassium salt, (2E,4E)-	24634-61-5	Contains (regardless of intentional or impurities)	chemical products
10617	Nickelate(1-), trichloro-, ammonium	24640-21-9	Contains (regardless of intentional or impurities)	chemical products
10618	Vanadium nitride (VN)	24646-85-3	Intentional addition / 1%	chemical products
10619	Decyl (Z,Z)-6,6-dibutyl-4,8,11-trioxo-5,7,12-trioxo-6-stannadocosa-2,9-dienoate	24660-23-9	Contains (regardless of intentional or impurities)	chemical products
10620	Chromium N,N'-1,2-ethanedibis[N-(carboxymethyl)glycinate]	24669-13-4	Intentional addition / 1,000ppm	chemical products
10621	Benzeneselenazolum, 3-ethyl-2-[3-(3-ethyl-2(3H)-benzeneselenazolidene)-2-methyl-1-propenyl]-, bromide	24687-31-8	Contains (regardless of intentional or impurities)	chemical products
10622	Hydrogen-2-[2-[[5-methoxy-3-(3-sulphonatopropyl)-3H-benzeneselenazol-2-ylidene]methyl]but-1-enyl]-5,6-dimethyl-3-(3-sulphonatopropyl)benzothiazolum	24687-35-2	Contains (regardless of intentional or impurities)	chemical products
10623	Cobalt, [dihydrogen (ethylene)dinitro]tetraacetato-	24704-41-4	Intentional addition / 1%	chemical products
10624	Triammonium arsenate	24719-13-9	Contains (regardless of intentional or impurities)	chemical products
10625	Arsenic acid (H3AsO4), cobalt(2+) salt (2:3)	24719-19-5	Contains (regardless of intentional or impurities)	chemical products
10626	Zirconate(2-), oxobis[sulfato(2-)-O]-, disodium	24735-35-1	Contains (regardless of intentional or impurities)	chemical products
10627	Benzonitrile, 4-[[4-ethoxyphenyl]methylene]amino]-, (E)-	24742-30-1	Intentional addition	chemical products
10628	Hexane, 2,5-dibromo-	24774-58-1	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
10629	Thiocyanic acid, compound with hydrazine (1:1)	24786-78-5	Contains (regardless of intentional or impurities)	chemical products
10630	Phenoxazin-5-ium, 3,7-bis(diethylamino)-, perchlorate	24796-94-9	Intentional addition / 1,000ppm	chemical products
10631	2,3,7,8,12,13,17,18-Octaethyl-21H,23H-porphine, nickel(II)	24803-99-4	Contains (regardless of intentional or impurities)	chemical products
10632	Ethanedioic acid, samarium salt	24804-30-6	Intentional addition	chemical products
10633	Iron(2+) di-L-ascorbate	24808-52-4	Intentional addition / 1%	chemical products
10634	[3-(2-Cyanoethoxy)-3-methyl-1-butenyl]trimethoxysilane	24820-56-2	Intentional addition	chemical products
10635	Cobalt tetra(2-ethylhexyl) bis(phosphate)	24828-48-4	Intentional addition / 1,000ppm	chemical products
10636	Boron, trifluoro(2-methylphenol), (T-4)-	24833-44-1	Intentional addition / 1%	chemical products
10637	Allyltributylstannane	24850-33-7	Contains (regardless of intentional or impurities)	chemical products
10638	[9,12-Octadecadienoic acid (Z,Z)-, barium salt	24871-38-3	Intentional addition / 1,000ppm	chemical products
10639	Vanadium, tris(cyclohexanolato)oxo-, (T-4)-	24910-41-6	Intentional addition / 1%	chemical products
10640	Ethene, chlorotrifluoro-, polymer with chloroethene	24937-97-1	Intentional addition / 1,000ppm	chemical products
10641	Polyoxyethylene tridecyl ether	24938-91-8	Intentional addition / 1%	chemical products
10642	Plumbanethyllum, diethyl-	24952-85-6	Contains (regardless of intentional or impurities)	chemical products
10643	m-Formylbenzotrile	24964-64-5	Intentional addition	chemical products
10644	Tris(bromophenyl)ammonium hexachloroantimonate	24964-91-8	Contains (regardless of intentional or impurities)	chemical products
10645	Vinyltoluene	25013-15-4	Contains (regardless of intentional or impurities)	chemical products
10646	Butylated Hydroxyanisole	25013-16-5	Contains (regardless of intentional or impurities)	chemical products
10647	Chromium trichlorate nonahydrate	25013-81-4	Intentional addition / 1,000ppm	chemical products
10648	1,3,2-Dioxaborolane, 4,4,5,5-tetramethyl-	25015-63-8	Intentional addition / 1%	chemical products
10649	Bisphenol A diglycidyl ether-bisphenol A copolymer	25036-25-3	Intentional addition / 1%	chemical products
10650	Phosphonic acid, butyl-, tin(2+) salt (1:1)	25044-90-0	Intentional addition / 1,000ppm	chemical products
10651	Phosphonic acid, heptyl-, tin(2+) salt (1:1)	25044-92-2	Intentional addition / 1,000ppm	chemical products
10652	Teflon	25067-11-2	Intentional addition / 1,000ppm	chemical products
10653	Bisphenol A-epichlorohydrin polymer	25068-38-6	Contains (regardless of intentional or impurities)	chemical products
10654	Carbonic acid, barium salt	25070-31-9	Intentional addition / 1,000ppm	chemical products
10655	Propylene-chlorotrifluoroethylene copolymer	25101-39-7	Intentional addition / 1,000ppm	chemical products
10656	tert-Dodecanethiol	25103-58-6	Intentional addition / 1%	chemical products
10657	1,2-Dibromo-3-butanone	25109-57-3	Contains (regardless of intentional or impurities)	chemical products
10658	Acetic acid, indium(3+) salt	25114-58-3	Intentional addition / 1%	chemical products
10659	4-Oxo-1-phenylcyclohexanenitrile	25115-74-6	Intentional addition	chemical products
10660	p-Ethoxybenzotrile	25117-74-2	Intentional addition	chemical products
10661	3-Ethoxybenzotrile	25117-75-3	Intentional addition	chemical products
10662	1-Propene, polymer with chloroethene	25119-90-8	Intentional addition / 1,000ppm	chemical products
10663	Copolymer of fluoroethene and perfluoroethene	25120-57-4	Intentional addition / 1,000ppm	chemical products
10664	Hexafluoropropene-vinyl fluoride polymer	25120-58-5	Intentional addition / 1,000ppm	chemical products
10665	3,7-Diaminophenothiazin-5-ium perchlorate	25137-58-0	Intentional addition / 1,000ppm	chemical products
10666	Nicotine, compound with 4-(1-cyclohexyl)butyl-2,6-dinitrophenol(1:1)	25137-75-1	Contains (regardless of intentional or impurities)	chemical products
10667	Cobalt metasilicate	25139-08-6	Intentional addition / 1,000ppm	chemical products
10668	Propanenitrile, 2-[(1,1-dimethylethyl)azo]-2-methyl-	25149-46-6	Intentional addition	chemical products
10669	Cyclohexanecarbonitrile, 1-[[1,1-dimethylethyl)azo]-	25149-47-7	Intentional addition	chemical products
10670	1,1,3,3-tetrabutyl-1,3-bis(dodecyl)distannoxane	25150-98-5	Contains (regardless of intentional or impurities)	chemical products
10671	Butyltris(1-oxododecyl)oxystannane	25151-00-2	Contains (regardless of intentional or impurities)	chemical products
10672	Aluminum, compound with antimony (1:1)	25152-52-7	Contains (regardless of intentional or impurities)	chemical products
10673	Chlorobutanes	25154-42-1	Intentional addition / 1,000ppm	chemical products
10674	Nonylphenols	25154-52-3	Contains (regardless of intentional or impurities)	chemical products
10675	Dinitrobenzenes	25154-54-5	Contains (regardless of intentional or impurities)	chemical products
10676	Sodium dodecylbenzenesulfonate	25155-30-0	Intentional addition / 1%	chemical products
10677	Perboric acid (H3BO2O2)	25156-16-5	Intentional addition / 1%	chemical products
10678	Aluminate(2-), pentafluoro-, barium	25165-45-1	Contains (regardless of intentional or impurities)	chemical products
10679	Tetrabromoethane	25167-20-8	Intentional addition / 1,000ppm	chemical products
10680	Benzenesulfonic acid, oxybis(dodecyl-, disodium salt	25167-32-2	Intentional addition / 1,000ppm	chemical products
10681	Butene	25167-67-3	Intentional addition / 1,000ppm	chemical products
10682	Monochlorophenols	25167-80-0	Contains (regardless of intentional or impurities)	chemical products
10683	Dichlorofluoroethane	25167-88-8	Contains (regardless of intentional or impurities)	chemical products
10684	Acetic acid, (2,4,5-trichlorophenoxy)-, isooctyl ester	25168-15-4	Intentional addition / 1,000ppm	chemical products
10685	2-Butenoic acid, 4,4'-[(dibutylstannylene)bis(oxo)]bis[4-oxo-, diisooctyl ester, (Z,Z)-	25168-21-2	Contains (regardless of intentional or impurities)	chemical products
10686	Stannane, dibutylbis(1-oxododecyl)oxy-	25168-22-3	Contains (regardless of intentional or impurities)	chemical products
10687	Tin, tetrabutylbis(mu-hydrogen maleato)-mu-oxido-, diisooctyl ester	25168-23-4	Intentional addition / 1,000ppm	chemical products
10688	Dibutyltin bis(isooctyl mercaptoacetate)	25168-24-5	Contains (regardless of intentional or impurities)	chemical products
10689	Chromium methacrylate	25182-44-9	Intentional addition / 1,000ppm	chemical products
10690	2,2',4,4'-Tetrachlorobenzophenone	25187-08-0	Contains (regardless of intentional or impurities)	chemical products
10691	1-Butene, polymer with chloroethene	25189-25-7	Intentional addition / 1,000ppm	chemical products
10692	Cobalt(II) sulfate hexahydrate	25215-19-4	Intentional addition / 1%	chemical products
10693	1,2-Benzenedicarboxylic acid, 1-butyl ester, copper salt (1:2)	25215-53-6	Intentional addition / 1,000ppm	chemical products
10694	Nicotine, compound with alpha-(3,5-dibromo-4-hydroxyphenyl)-alpha-(3,5-dibromo-4-oxo-2,5-cyclohexadien-1-ylidene)-o-toluenesulfonic acid	25221-70-9	Contains (regardless of intentional or impurities)	chemical products
10695	Tin, tetrabutylbis(mu-hydrogen maleato)-mu-oxido-, diisooctyl ester	25248-71-9	Intentional addition / 1,000ppm	chemical products
10696	1,3,5-Triazine-1,3,5(2H,4H,6H)-trihydroxy, alpha, alpha, alpha'-trimethyl-	25254-50-6	Intentional addition / 100ppm	chemical products
10697	Phenylenediamines	25265-76-3	Intentional addition / 1,000ppm	chemical products
10698	Copper trichlorophenolate	25267-55-4	Intentional addition / 1,000ppm	chemical products
10699	Tetrakis(pentane-2,4-dionato-O,O')tin	25267-66-7	Contains (regardless of intentional or impurities)	chemical products
10700	Telluric acid (H2TeO4), aluminum salt (3:2)	25268-69-3	Contains (regardless of intentional or impurities)	chemical products
10701	Antimony fluoride (SbF)	25285-72-7	Contains (regardless of intentional or impurities)	chemical products
10702	4-Ethylbenzotrile	25309-65-3	Intentional addition	chemical products
10703	Isofenphos	25311-71-1	Contains (regardless of intentional or impurities)	chemical products
10704	Dinitrotoluenes	25321-14-6	Contains (regardless of intentional or impurities)	chemical products
10705	Dichlorobenzene (mixed isomers)	25321-22-6	Intentional addition / 1,000ppm	chemical products
10706	Nitropropane	25322-01-4	Intentional addition / 1%	chemical products
10707	Naphthalenesulfonic acid, dinonyl-	25322-17-2	Intentional addition / 100ppm	chemical products
10708	Tetrachloroethanes	25322-20-7	Intentional addition / 1,000ppm	chemical products
10709	Dichloroethylenes	25323-30-2	Intentional addition / 1,000ppm	chemical products
10710	Trichloroethane	25323-89-1	Intentional addition / 1,000ppm	chemical products
10711	Tin phosphide (SnP)	25324-56-5	Contains (regardless of intentional or impurities)	chemical products
10712	Thiocyanic acid, manganese(2+) salt	25327-03-1	Contains (regardless of intentional or impurities)	chemical products
10713	Allyl ether of tetrabromobisphenol-A	25327-89-3	Contains (regardless of intentional or impurities)	chemical products
10714	Isodecanol	25339-17-7	Intentional addition / 1%	chemical products
10715	Pentane, 3-bromo-3-methyl-	25346-31-0	Intentional addition / 1,000ppm	chemical products
10716	Pentane, 1-bromo-2-methyl-	25346-33-2	Intentional addition / 1,000ppm	chemical products
10717	1,2-Benzenedicarboxylic acid, 3,4,5,6-tetrabromo-, disodium salt	25357-79-3	Intentional addition / 900ppm	chemical products
10718	Benzenediamine, ar-methyl-	25376-45-8	Contains (regardless of intentional or impurities)	chemical products
10719	Card-20(22)-enolide, 3-[(O-2,6-dideoxy-beta-D-ribo-hexopyranosyl(1->4)-O-2,6-dideoxy-beta-D-ribo-hexopyranosyl(1->4)-2,6-dideoxy-beta-D-ribo-hexopyranosyl)oxy]-14-hydroxy-, monoacetate, (3beta,5beta)-	25395-32-8	Intentional addition / 1%	chemical products
10720	Barium sulfide (Ba(SH)2)	25417-81-6	Intentional addition	chemical products
10721	Tetraoctylammonium perchlorate	25423-85-2	Intentional addition / 1,000ppm	chemical products
10722	Ferrate(3-), tris(4-hydroxy-3-nitroso-1-naphthalenesulfonato(2-))-O3,O4]-, trisodium	25424-72-0	Intentional addition / 1%	chemical products
10723	Selenious acid, ammonium salt (2:1)	25425-97-2	Contains (regardless of intentional or impurities)	chemical products
10724	Ethanedioic acid, calcium salt	25444-93-3	Intentional addition	chemical products
10725	Tris(heptane-3,5-dionato-O,O')iron	25459-79-4	Intentional addition / 1%	chemical products
10726	2-Octene, 1-bromo-	25466-54-0	Intentional addition / 1,000ppm	chemical products
10727	Sodium selenosulfate	25468-09-1	Contains (regardless of intentional or impurities)	chemical products
10728	Rhodium, carbonyl(2,4-pentanedionato-O,O')(triphenylphosphine)-, (SP-4-2)-	25470-96-6	Contains (regardless of intentional or impurities)	chemical products
10729	Dicarbonyldichloroplatinum	25478-80-8	Contains (regardless of intentional or impurities)	chemical products
10730	Nickelate(2-), [[N-1,2-ethanediybis[N-(carboxymethyl)glycinate][4-(N,N,O,O',ON,ON)-, dihydrogen, (OC-6-21)-	25481-21-4	Contains (regardless of intentional or impurities)	chemical products
10731	Benzoic acid, 3-bromo-	25487-66-5	Intentional addition / 1%	chemical products
10732	Phenol, thallium(1+) salt	25491-50-3	Intentional addition / 1,000ppm	chemical products
10733	Methylhexanes	25495-88-9	Intentional addition / 1%	chemical products
10734	Hexane, ethyl-	25495-89-0	Intentional addition / 1%	chemical products
10735	Hexane, chloro-	25495-90-3	Intentional addition / 1,000ppm	chemical products
10736	Hexane, bromo-	25495-91-4	Intentional addition / 1,000ppm	chemical products
10737	Benzenesulfonic acid, tridecyl-	25496-01-9	Intentional addition / 1%	chemical products
10738	Difluoroethane	25497-28-3	Intentional addition / 1,000ppm	chemical products
10739	Chlorodifluoroethane	25497-29-4	Intentional addition / 1,000ppm	chemical products
10740	Dibromotetrafluoroethane	25497-30-7	Intentional addition / 1,000ppm	chemical products
10741	Copper, [hydrogen phthalocyaninesulfonato(2-)]-, monoammonium salt	25512-09-8	Intentional addition / 1,000ppm	chemical products
10742	Cuprate(3-), [29H,31H-phthalocyanine-C.C.C-trisulfonato(5-)-N29,N30,N31,N32]-, triammonium	25512-11-2	Intentional addition / 1,000ppm	chemical products
10743	Cuprate(4-), [29H,31H-phthalocyanine-C.C.C.C-tetrasulfonato(6-)-N29,N30,N31,N32]-, tetraammonium	25512-12-3	Intentional addition / 1,000ppm	chemical products
10744	Cuprate(4-), [29H,31H-phthalocyanine-2,9,16,23-tetrasulfonato(6-)-kappa.N29.kappa.N30.kappa.N31.kappa.N32]-, tetrahydrogen, (SP-4-1)-	25512-85-0	Intentional addition / 1,000ppm	chemical products
10745	Dinitrophenols	25550-58-7	Contains (regardless of intentional or impurities)	chemical products
10746	Benzene, trimethyl-	25551-13-7	Intentional addition / 1%	chemical products
10747	Nonane, 1-bromo-4,4-dimethyl-	25570-12-1	Intentional addition / 1,000ppm	chemical products
10748	Tris(benzoato-O)loxovanadium	25578-30-7	Intentional addition / 1%	chemical products
10749	Naphthalene, chloro-	25586-43-0	Intentional addition	chemical products
10750	Ethanedioic acid, aluminum salt	25592-27-2	Intentional addition	chemical products
10751	Indium nitride	25617-98-5	Intentional addition / 1%	chemical products
10752	Barium dinonylnaphthalenesulfonate	25619-56-1	Contains (regardless of intentional or impurities)	chemical products
10753	Dibromoethane	25620-62-6	Intentional addition / 1,000ppm	chemical products
10754	Hexapentylidistannoxane	25637-27-8	Contains (regardless of intentional or impurities)	chemical products
10755	Beryllium zinc silicate	25638-88-4	Contains (regardless of intentional or impurities)	chemical products
10756	Methylcyclohexanols	25639-42-3	Contains (regardless of intentional or impurities)	chemical products
10757	Propane, tetrachloro-	25641-62-7	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
10758	2-Pyrrolidinone, 1-ethenyl-, homopolymer, compound with iodine	25655-41-8	Intentional addition / 1,000ppm	chemical products
10759	Zirconium nitride (ZrN)	25658-42-8	Contains (regardless of intentional or impurities)	chemical products
10760	Uranium nitride (UN)	25658-43-9	Contains (regardless of intentional or impurities)	chemical products
10761	Manganese iodate	25659-29-4	Contains (regardless of intentional or impurities)	chemical products
10762	Ethene, tetrafluoro-, polymer with 1,1-difluoroethene	25684-76-8	Intentional addition / 1,000ppm	chemical products
10763	Zirconium(4+) propionate	25710-96-7	Contains (regardless of intentional or impurities)	chemical products
10764	5,5,12,12-Tetraethyl-8-methylene-7,10-dioxo-6,11-dioxo-5,12-distannahexadecane	25711-26-6	Contains (regardless of intentional or impurities)	chemical products
10765	Benzoic acid, 2-hydroxy-, chromium salt	25718-61-0	Contains (regardless of intentional or impurities)	chemical products
10766	Diphosphoric acid, copper(2+) potassium salt (2:1:6)	25721-57-7	Intentional addition / 1,000ppm	chemical products
10767	Trichloropropane	25735-29-9	Intentional addition / 1,000ppm	chemical products
10768	Barium N,N'-1,2-ethanedibis[N-(carboxymethyl)glycinate	25737-53-5	Contains (regardless of intentional or impurities)	chemical products
10769	Nickel ammonium sulfate (2:2:3)	25749-98-0	Contains (regardless of intentional or impurities)	chemical products
10770	Tris(pentane-2,4-dionato-O,O')antimony	25751-57-9	Contains (regardless of intentional or impurities)	chemical products
10771	2,6-Bis(trifluoromethyl)benzonitrile	25753-25-7	Intentional addition	chemical products
10772	Yttrium nitride (YN)	25764-13-0	Intentional addition / 1%	chemical products
10773	Stannate(2-), tetrachloro-, dipotassium, monohydrate, (T-4)-	25791-99-5	Intentional addition / 1,000ppm	chemical products
10774	Acetonitrile, (methylamino)-, monohydrochloride	25808-30-4	Intentional addition	chemical products
10775	Manganese fluosilicate	25808-75-7	Contains (regardless of intentional or impurities)	chemical products
10776	Hafnium nitride (HfN)	25817-87-2	Intentional addition / 1%	chemical products
10777	Silver thallium dinitrate	25822-21-3	Contains (regardless of intentional or impurities)	chemical products
10778	Trihydrogen [4,5-dihydro-4-[[2-hydroxy-4-[[2-(sulphoxy)ethyl]sulphonyl]phenyl]azo]-5-oxo-1-(4-sulphophenyl)-1H-pyrazole-3-carboxylato(5-)]cuprate(3-)	25828-75-5	Intentional addition / 1,000ppm	chemical products
10779	Acetic acid, 2,2,2-[[butylstannylidene]tris(thio)]tris-, trisooctyl ester	25852-70-4	Contains (regardless of intentional or impurities)	chemical products
10780	Manganese fluosilicate (MnSiF6), hexahydrate	25868-86-4	Contains (regardless of intentional or impurities)	chemical products
10781	Ferrate(4-), hexakis(cyano-C)-, ammonium iron(3+) (1:1:1), (OC-6-11)-	25869-00-5	Contains (regardless of intentional or impurities)	chemical products
10782	Copper hexafluorosilicate tetrahydrate	25869-11-8	Intentional addition / 1,000ppm	chemical products
10783	Ferrate(4-), hexakis(cyano-C)-, iron(3+) potassium (1:1:1), (OC-6-11)-	25869-98-1	Intentional addition / 1%	chemical products
10784	Antimony phosphide (SbP)	25889-81-0	Contains (regardless of intentional or impurities)	chemical products
10785	Borate(1-), (cyano-C)trihydro-, sodium, (T-4)-	25895-60-7	Intentional addition / 1%	chemical products
10786	2-Pentenenitrile, (Z)-	25899-50-7	Contains (regardless of intentional or impurities)	chemical products
10787	Platinum trichloride	25909-39-1	Contains (regardless of intentional or impurities)	chemical products
10788	Dichlorodifluoroethanes	25915-78-0	Intentional addition / 1,000ppm	chemical products
10789	Trimethylselenonium	25930-79-4	Contains (regardless of intentional or impurities)	chemical products
10790	Dibutylbis(nonanoxy)stannane	25955-19-5	Contains (regardless of intentional or impurities)	chemical products
10791	Thiopyrylium, 4-[[4-(dimethylamino)phenyl]-2,6-diphenyl-, tetrafluoroborate(1-)	25966-12-5	Intentional addition / 1%	chemical products
10792	Cobalt, tetrakis(2,3-butanedione dioximato(1-)-N,N')bis(pyridine)di-, (Co-Co)	25971-15-7	Intentional addition / 1,000ppm	chemical products
10793	Copper bis[1R-(1.alpha.,4.alpha.,4b.beta.,10a.beta.)]-1,2,3,4,4a,5,10,10a-decahydro-7-isopropyl-1,4a-dimethylphenanthren-1-carboxylate	25986-23-6	Intentional addition / 1,000ppm	chemical products
10794	Lasalocid sodium	25999-20-6	Intentional addition / 2%	chemical products
10795	Lasalocid	25999-31-9	Intentional addition / 2%	chemical products
10796	Platinate(2-), hexachloro-, dihydrogen, hydrate, (OC-6-11)-	26023-84-7	Contains (regardless of intentional or impurities)	chemical products
10797	Nickel carbonyl (Ni(CO)3)	26024-55-5	Contains (regardless of intentional or impurities)	chemical products
10798	Platinum, diamminedichloro-	26035-31-4	Contains (regardless of intentional or impurities)	chemical products
10799	Boric acid (H3BO3), compound with 2-aminoethanol	26038-87-9	Intentional addition / 1%	chemical products
10800	Boric acid (H3BO3), compound with 1-amino-2-propanol	26038-90-4	Intentional addition / 1%	chemical products
10801	1,2-Benzenedicarboxylic acid, 3,4,5,6-tetrabromo-, bis(2-ethylhexyl) ester	26040-51-7	Intentional addition / 900ppm	chemical products
10802	Phosphate(1-), hexafluoro-, silver(1+)	26042-63-7	Intentional addition / 25%	chemical products
10803	Antimonate(1-), hexafluoro-, silver(1+), (OC-6-11)-	26042-64-8	Contains (regardless of intentional or impurities)	chemical products
10804	Silicate(2-), hexafluoro-, nickel(2+) (1:1)	26043-11-8	Contains (regardless of intentional or impurities)	chemical products
10805	Nickel hexafluorosilicate hexahydrate	26045-73-8	Contains (regardless of intentional or impurities)	chemical products
10806	L-Alanine, 3-(methylseleno)-	26046-90-2	Contains (regardless of intentional or impurities)	chemical products
10807	Cuprate(2-), [[21-carboxy-9-ethenyl-14-ethyl-4,8,13,18-tetramethyl-20-oxo-3-phorbipropanoato(4-)-N23,N24,N25,N26]-disodium, [SP-4-2-[3S-(3.alpha.,4.beta.,21.beta.)]]	26061-35-8	Intentional addition / 1,000ppm	chemical products
10808	Rhodate(1-), [[N-(carboxymethyl)-1-(2-hydroxyethyl)-N,N'-ethylenediamine]glycinate(3-)]chloro-, hydrogen, compound with trycitrine (1:1)	26061-47-2	Contains (regardless of intentional or impurities)	chemical products
10809	1-Nitroso-2-naphthol cobalt complex	26076-28-8	Intentional addition / 1%	chemical products
10810	2,5-Thiohenyldibisboronic acid	26078-46-0	Intentional addition / 1%	chemical products
10811	S-Benzyl diisopropyl phosphorothioate	26087-47-8	Contains (regardless of intentional or impurities)	chemical products
10812	Benzene, 1,3-diisocyanato-2(or 4)-methyl-	26102-02-3	Intentional addition / 1%	chemical products
10813	Rhodium(3+) acetate	26105-49-7	Contains (regardless of intentional or impurities)	chemical products
10814	Phenylmercuric-8-quinolinate	26114-17-0	Contains (regardless of intentional or impurities)	chemical products
10815	Barium metaborate monohydrate	26124-96-7	Intentional addition / 1%	chemical products
10816	Terphenyls	26140-60-3	Contains (regardless of intentional or impurities)	chemical products
10817	1-(Triphenylmethyl)pyridinium tetrafluoroborate	26156-84-3	Intentional addition / 1%	chemical products
10818	3(2H)-Isothiazolone, 5-chloro-2-methyl-	26172-55-4	Intentional addition / 1,000ppm	chemical products
10819	Strychnidin-10-one, mono(+)3-amino-5-[[dimethylamino]carbonyl]-2,4,6-triiodobenzoate]	26190-91-0	Contains (regardless of intentional or impurities)	chemical products
10820	Hexadecanoic acid, manganese(2+) salt	26204-60-4	Contains (regardless of intentional or impurities)	chemical products
10821	Cobalt, [bis(mu-[[2,3-butanedione 2,3-di(oximato)-kappa(O)](2-)]tetrafluorodiborate(2-)-kappa(N,kappa(N),kappa(N),kappa(N)N')]-, (SP-4-1)-	26220-72-4	Intentional addition / 1%	chemical products
10822	Benzenesulfonic acid, tridecyl-, sodium salt	26248-24-8	Intentional addition / 1%	chemical products
10823	Boric acid (H3BO3), tris(methylphenyl) ester	26248-41-9	Intentional addition / 1%	chemical products
10824	Dibromobenzene	26249-12-7	Intentional addition / 1,000ppm	chemical products
10825	Magenta II	26261-57-4	Intentional addition / 1%	chemical products
10826	14-(Nonylphenoxy)-3,6,9,12-tetraoxatetradecan-1-ol	26264-02-8	Intentional addition / 1,000ppm	chemical products
10827	Benzenesulfonic acid, dodecyl-, calcium salt	26264-06-2	Intentional addition / 1%	chemical products
10828	1,1'-Biphenyl, bromo-	26264-10-8	Intentional addition / 1,000ppm	chemical products
10829	Cadmium epoxyoctadecanoate	26264-48-2	Contains (regardless of intentional or impurities)	chemical products
10830	Barium epoxyoctadecanoate	26264-65-3	Contains (regardless of intentional or impurities)	chemical products
10831	Selenious acid, rubidium salt (2:1)	26271-85-2	Contains (regardless of intentional or impurities)	chemical products
10832	Carbonic acid, iron(3+) salt (3:2)	26273-46-1	Intentional addition / 1%	chemical products
10833	8-Oxa-3,5-dithia-4-stannaicosanoic acid, 4-butyl-4-[[2-(dodecyloxy)-2-oxoethyl]thio]-7-oxo-, dodecyl ester	26292-98-8	Contains (regardless of intentional or impurities)	chemical products
10834	2-Pentenenitrile, (E)-	26294-98-4	Contains (regardless of intentional or impurities)	chemical products
10835	Chromate(1-), chlorotrioxo-, (T-4)-, hydrogen, compound with pyridine (1:1)	26299-14-9	Contains (regardless of intentional or impurities)	chemical products
10836	1-Pentene, 4-methyl-, polymer with chloroethene	26300-97-0	Intentional addition / 1,000ppm	chemical products
10837	Dibutylbis[2-(3-carboxyacryloyloxy)stannane, ester with dipropylene glycol (1:2)	26302-30-7	Contains (regardless of intentional or impurities)	chemical products
10838	Chlorotris(triphenylphosphine)cobalt(I)	26305-75-9	Intentional addition / 1%	chemical products
10839	Trihydrogen (2S-trans)-[18-carboxy-20-(carboxymethyl)-13-ethyl-2,3-dihydro-3,7,12,17-tetramethyl-8-vinyl-21H,23H-porphine-2-propionato(5-)-N21,N22,N23,N24]cuprate(3-)	26317-27-1	Intentional addition / 1,000ppm	chemical products
10840	Tetrahydrogen [mu-[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-naphthalene-2,7-disulphonato]](8-)]dicuprate(4-)	26321-58-4	Intentional addition / 1,000ppm	chemical products
10841	Chromium phosphide (CrP)	26342-61-0	Intentional addition / 1,000ppm	chemical products
10842	2-Propenoic acid, 2-methyl-, methyl ester, polymer with tributyl[[2-methyl-1-oxo-2-propenyl]oxy]stannane	26354-18-7	Contains (regardless of intentional or impurities)	chemical products
10843	Butane, 3-bromo-2,2-dimethyl-	26356-06-9	Intentional addition / 1,000ppm	chemical products
10844	[Hexabutyl(mu-sulphato(2-)-O,O')O']ditin	26377-04-8	Contains (regardless of intentional or impurities)	chemical products
10845	Propane, 2-bromo-1,1,2,3,3-pentafluoro-	26391-11-7	Intentional addition / 1,000ppm	chemical products
10846	1-Propene, 1,2-dibromo-	26391-16-2	Intentional addition / 1,000ppm	chemical products
10847	Cuprate(4-), [29H,31H-phthalocyanine-C.C.C.C-tetrasulfonato(6-)-N29,N30,N31,N32]-, tetrahydrogen	26400-93-1	Intentional addition / 1,000ppm	chemical products
10848	Trisooctyl orthoborate	26401-30-9	Intentional addition / 1%	chemical products
10849	sec-Octane, bromo-	26401-33-2	Intentional addition / 1,000ppm	chemical products
10850	Monocytin tris(isooctyl thioglycolate)	26401-86-5	Contains (regardless of intentional or impurities)	chemical products
10851	Diocytin bis(isooctyl thioglycolate)	26401-97-8	Contains (regardless of intentional or impurities)	chemical products
10852	Poly[bis(phenyl A 2-hydroxypropyl ether)	26402-79-9	Intentional addition / 1%	chemical products
10853	tert-Dodecanethiol, gold(1+) salt	26403-08-7	Intentional addition	chemical products
10854	Stannane, butylmercaptooxo-	26410-42-4	Contains (regardless of intentional or impurities)	chemical products
10855	Chromium(3+) methacrylate	26416-07-9	Intentional addition / 1,000ppm	chemical products
10856	Monochloropropane	26446-76-4	Intentional addition / 1,000ppm	chemical products
10857	Bromopropanes	26446-77-5	Intentional addition / 1,000ppm	chemical products
10858	Oresyl glycidyl ether	26447-14-3	Contains (regardless of intentional or impurities)	chemical products
10859	Benzene, 1,1'-methylenebis[isocyanato-	26447-40-5	Contains (regardless of intentional or impurities)	chemical products
10860	Benzene, 1,3-diisocyanatomethyl-	26471-62-5	Contains (regardless of intentional or impurities)	chemical products
10861	Cobalt(II) fluoroborate	26490-63-1	Contains (regardless of intentional or impurities)	chemical products
10862	Tris(3-methylbutan-1-olato)oxovanadium	26496-12-8	Intentional addition / 1%	chemical products
10863	Copper chlorate	26506-47-8	Contains (regardless of intentional or impurities)	chemical products
10864	Iron phosphide (FeP)	26508-33-8	Intentional addition / 1%	chemical products
10865	Titanium borofluoride complex salt	26522-24-7	Contains (regardless of intentional or impurities)	chemical products
10866	Trichlorotrifluoroethane	26523-64-8	Intentional addition / 1,000ppm	chemical products
10867	Phenol, nonyl-, phosphite (3:1)	26523-78-4	Contains (regardless of intentional or impurities)	chemical products
10868	Ammonium, cyclopentylidenediphenyl-, perchlorate	26529-13-5	Intentional addition / 1,000ppm	chemical products
10869	Benzenaminium, N-[2,5-bis(phenylamino)methylene]cyclopentylidene]-N-phenyl-, perchlorate	26529-14-6	Intentional addition / 1,000ppm	chemical products
10870	3(2H)-Isothiazolone, 2-oxyl-	26530-20-1	Contains (regardless of intentional or impurities)	chemical products
10871	2,5-Furandione, dihydro-3-(tetrapropenyl)-	26544-38-7	Intentional addition / 100ppm	chemical products
10872	2-Methylpentane-2,4-diol, ester with orthoboric acid (3:2)	26545-48-2	Intentional addition / 1%	chemical products
10873	Hydrogen [3-(alpha-carboxylato-o-anisoyl)amino]-2-hydroxypropyl[hydroxymercurate(1-)]	26552-50-1	Contains (regardless of intentional or impurities)	chemical products
10874	Triamminetrichlororhodium	26566-80-3	Contains (regardless of intentional or impurities)	chemical products
10875	Copper, [29H,31H-phthalocyanine-C-sulfonyl chloridato(2-)-N29,N30,N31,N32]-	26570-87-6	Intentional addition / 1,000ppm	chemical products
10876	3,6,9,12,15,18,21,24-Octaoxahexacosan-1-ol, 26-(nonylphenoxy)-	26571-11-9	Intentional addition / 1,000ppm	chemical products
10877	Mercuric iodide thiocyanate	26579-33-9	Contains (regardless of intentional or impurities)	chemical products
10878	Chlorotrifluoropropane	26588-23-8	Intentional addition / 1,000ppm	chemical products
10879	1,3-Isobenzofurandione, 3a,4,7a-tetrahydro-methyl-	26590-20-5	Contains (regardless of intentional or impurities)	chemical products
10880	Bromobutane	26602-89-1	Intentional addition / 1,000ppm	chemical products
10881	Cobalt(II) 2,3-naphthalocyanine	26603-20-3	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
10882	Nickel, [3,7H,3,9H-tetranaphtho[2,3-b:2',3'-g:2'',3''-l2'',3'''-q]porphyrinato(2-)-N37,N38,N39,N40]-, (SP-4-1)-	26603-21-4	Contains (regardless of intentional or impurities)	chemical products
10883	Barium magnesium orthosilicate(1:2:1)	26603-62-3	Intentional addition / 1,000ppm	chemical products
10884	Sodium azide	26628-22-8	Contains (regardless of intentional or impurities)	chemical products
10885	Isocetane	26635-64-3	Contains (regardless of intentional or impurities)	chemical products
10886	Dimethyltin S,S'-bis(isooctyl mercaptoacetate)	26636-01-1	Contains (regardless of intentional or impurities)	chemical products
10887	Poly(oxy-1,2-ethanedivyl), alpha-(4-octylphenyl)-omega-hydroxy-	26636-32-8	Intentional addition / 1%	chemical products
10888	Dichloropropane	26638-19-7	Intentional addition / 1,000ppm	chemical products
10889	Butanedioic acid, (tetrapropenyl)-, 1-methyl ester, barium salt	26655-43-6	Contains (regardless of intentional or impurities)	chemical products
10890	Copper thiocyanate	26656-82-6	Intentional addition / 1,000ppm	chemical products
10891	Oxalic acid, thulium(3+) salt (3:2), hexahydrate	26677-68-9	Intentional addition / 1,000ppm	chemical products
10892	Cobalt silicate	26686-74-8	Intentional addition / 1,000ppm	chemical products
10893	2-Propanoic acid, 2-methyl-, 2-[(1,1-dimethylethyl)amino]ethyl ester, homopolymer	26716-20-1	Intentional addition / 100ppm	chemical products
10894	Oxtyloxostannane	26738-80-7	Contains (regardless of intentional or impurities)	chemical products
10895	Octane, bromo-	26746-34-9	Intentional addition / 1,000ppm	chemical products
10896	Diisododecyl phthalate	26761-40-0	Contains (regardless of intentional or impurities)	chemical products
10897	Propanoic acid, 3,3'-[(dibutylstannylenyl)bis(thio)]bis-, diisooctyl ester	26761-46-6	Contains (regardless of intentional or impurities)	chemical products
10898	Dichlorobutane	26761-81-9	Intentional addition / 1,000ppm	chemical products
10899	(Allyloxy)tribromobenzene	26762-91-4	Intentional addition / 900ppm	chemical products
10900	1,3-Benzenediamine, ar-methyl-	26764-44-3	Intentional addition / 1%	chemical products
10901	Methacrylic acid, polymers, compound with nicotine	26793-60-2	Contains (regardless of intentional or impurities)	chemical products
10902	2-Propanoic acid, 2-methyl-, homopolymer, isotactic, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine	26793-61-3	Contains (regardless of intentional or impurities)	chemical products
10903	Cycloheptatrienylium, (OC-6-11)-hexachloroantimonate(1-)	26810-97-9	Contains (regardless of intentional or impurities)	chemical products
10904	Acetic acid, [(butylthioxostannyl)thio]-, 2-ethylhexyl ester	26821-85-8	Contains (regardless of intentional or impurities)	chemical products
10905	2-[2-[2-(Tetradecyloxy)ethoxy]ethoxy]ethanol	26826-30-2	Intentional addition / 1%	chemical products
10906	Chloromethansulphenyl chloride	26826-80-2	Contains (regardless of intentional or impurities)	chemical products
10907	2-Nitro-4-tolunitrile	26830-95-5	Intentional addition	chemical products
10908	Boric acid (H4B2O5)	26851-55-8	Intentional addition / 1%	chemical products
10909	Copper(3+), [N,N,N',N',N',N',N',N'-nonamethyl-29H,31H-phthalocyanine-C,C,C-trimethanaminato(2-)-N29,N30,N31,N32]-, trichloride	26854-10-4	Intentional addition / 1,000ppm	chemical products
10910	8-Oxa-3,5-dithia-4-stibatetradecanoic acid, 10-ethyl-4-[[2-[(2-ethylhexyl)oxy]-2-oxoethyl]thio]-7-oxo-, 2-ethylhexyl ester	26864-36-8	Contains (regardless of intentional or impurities)	chemical products
10911	8-Oxa-3,5-dithia-4-stannatetradecanoic acid, 4-butyl-10-ethyl-4-[[2-[(2-ethylhexyl)oxy]-2-oxoethyl]thio]-7-oxo-, 2-ethylhexyl ester	26864-37-9	Contains (regardless of intentional or impurities)	chemical products
10912	2-Ethylhexyl [(tributylstannyl)thio]acetate	26864-39-1	Contains (regardless of intentional or impurities)	chemical products
10913	Cuprate(1-), [3-[(2,4-dihydroxyphenyl)azo]-4-hydroxybenzenesulfonato(3-)]-, hydrogen	26864-44-8	Intentional addition / 1,000ppm	chemical products
10914	Diethylene glycol bis [(butylthio) tin] thiocetate	26872-61-7	Intentional addition / 1,000ppm	chemical products
10915	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, homopolymer	26893-93-6	Intentional addition / 1,000ppm	chemical products
10916	Isocetyl [(tributylstannyl)thio]acetate	26896-31-1	Contains (regardless of intentional or impurities)	chemical products
10917	Dibenzyltoluene (all isomers)	26898-17-9	Intentional addition / 1%	chemical products
10918	Tin chloride (SnCl3)	26903-07-1	Contains (regardless of intentional or impurities)	chemical products
10919	Iodopropanes	26914-02-3	Intentional addition / 1,000ppm	chemical products
10920	Toluidines	26915-12-8	Contains (regardless of intentional or impurities)	chemical products
10921	4-Bromo-3-methyl-2-butenic acid ethyl ester	26918-14-9	Contains (regardless of intentional or impurities)	chemical products
10922	Cobaltate(1-), bis[hydrogen 3-hydroxy-4-[[2-hydroxy-1-naphthyl)azo]-7-nitro-1-naphthalenesulfonato(2-)]-	26921-01-7	Intentional addition / 1,000ppm	chemical products
10923	Barium phosphonate	26946-37-2	Contains (regardless of intentional or impurities)	chemical products
10924	3-Isouquinoline carbonitrile	26947-41-1	Intentional addition	chemical products
10925	Dichloropropenes	26952-23-8	Intentional addition / 1,000ppm	chemical products
10926	2-Amino-4,5-dimethoxybenzonitrile	26961-27-3	Intentional addition	chemical products
10927	2,2-Dibutyl-1,3,2-dioxastannolane-4,5-dione	26962-66-5	Contains (regardless of intentional or impurities)	chemical products
10928	3(or 4)-Methylbenzene-1,2-diamine	26966-75-6	Intentional addition / 1%	chemical products
10929	Selenious acid, disodium salt, pentahydrate	26970-82-1	Contains (regardless of intentional or impurities)	chemical products
10930	1-Phenanthrenecarboxylic acid, 1,2,3,4,4a,5,6,10,10a-decahydro-1,4a-dimethyl-7-(1-methylethyl)-, cobalt salt, (1R,4aR,4bR,10aR)-	26988-20-9	Intentional addition / 1%	chemical products
10931	Copper tartrate	27004-40-6	Intentional addition / 1,000ppm	chemical products
10932	p-Isocetylphenol	27013-89-4	Intentional addition / 1%	chemical products
10933	Cobalt arsenide (CoAs)	27016-73-5	Contains (regardless of intentional or impurities)	chemical products
10934	Nickel arsenide	27016-75-7	Contains (regardless of intentional or impurities)	chemical products
10935	1-Propene, polymer with tetrafluoroethene	27029-05-6	Intentional addition / 1,000ppm	chemical products
10936	6-Chloro-3-nitropyridin-2-ylamine	27048-04-0	Intentional addition / 1%	chemical products
10937	Propane, hexafluoro-	27070-61-7	Intentional addition / 1,000ppm	chemical products
10938	Cycloheptatrienylium, tetrafluoroborate(1-)	27081-10-3	Intentional addition / 1%	chemical products
10939	Guanidine, N,N"-1,6-hexanediybis[isocyanato-, polymer with 1,6-hexanediamine, hydrochloride	27083-27-8	Contains (regardless of intentional or impurities)	chemical products
10940	Auochlorocobalamin	27085-12-7	Intentional addition / 1%	chemical products
10941	Chromium(III) phosphate	27096-04-4	Contains (regardless of intentional or impurities)	chemical products
10942	Monoctyltin tris(2-ethylhexyl thioglycolate)	27107-89-7	Contains (regardless of intentional or impurities)	chemical products
10943	Formic acid, chromium(3+) salt	27115-36-2	Intentional addition / 1,000ppm	chemical products
10944	Copper, [29H,31H-phthalocyanine-C,C,C-trisulfonyl trichloridato(2-)-N29,N30,N31,N32]-	27121-30-8	Intentional addition / 1,000ppm	chemical products
10945	[Tris(chloromethyl)-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	27121-79-5	Intentional addition / 1,000ppm	chemical products
10946	3,5-Bis(trifluoromethyl)benzonitrile	27126-93-8	Intentional addition	chemical products
10947	Chromium oxide (Cr8O21)	27133-42-2	Contains (regardless of intentional or impurities)	chemical products
10948	Chromic acid, barium potassium salt	27133-66-0	Contains (regardless of intentional or impurities)	chemical products
10949	Monochloroanilines	27134-26-5	Contains (regardless of intentional or impurities)	chemical products
10950	Dichloroanilines	27134-27-6	Contains (regardless of intentional or impurities)	chemical products
10951	[Triaminophthalocyaninato(2-)]copper, polymeric derivative, pigments	27137-19-5	Intentional addition / 1,000ppm	chemical products
10952	Phenylhydrazine hydrochloride	27140-08-5	Contains (regardless of intentional or impurities)	chemical products
10953	Tributyltin cinamate	27147-18-8	Contains (regardless of intentional or impurities)	chemical products
10954	Tricalcium diarsenite	27152-57-4	Contains (regardless of intentional or impurities)	chemical products
10955	Trichlorofluoroethane	27154-33-2	Contains (regardless of intentional or impurities)	chemical products
10956	Dodecylbenzenesulfonic acid	27176-87-0	Intentional addition / 1%	chemical products
10957	Ethanol, 2-[2-(nonylphenoxy)ethoxy]-	27176-93-8	Intentional addition / 1,000ppm	chemical products
10958	Hexaethylene glycol nonylphenyl ether	27177-01-1	Intentional addition / 1,000ppm	chemical products
10959	3,6,9,12,15,18,21-Heptaaxtricosan-1-ol, 23-(nonylphenoxy)-	27177-05-5	Intentional addition / 1,000ppm	chemical products
10960	3,6,9,12,15,18,21,24,27-Nonaxnonacosan-1-ol, 29-(nonylphenoxy)-	27177-08-8	Intentional addition / 1,000ppm	chemical products
10961	Benzenesulfonic acid, dodecyl-, potassium salt	27177-77-1	Intentional addition / 1%	chemical products
10962	Barium bis(thiobarate)	27184-78-7	Contains (regardless of intentional or impurities)	chemical products
10963	Tributyl(nicotinoyloxy)stannane	27189-59-9	Contains (regardless of intentional or impurities)	chemical products
10964	Tin, bis[hydrogen maleato(dioctyl)-, diester with 1,2-propanediol	27194-44-1	Intentional addition / 1,000ppm	chemical products
10965	p-sec-Octylphenol	27214-47-7	Intentional addition / 1%	chemical products
10966	Mercurate(2-), tetraiodo-, copper(2+) (1:1), (T-4)-	27228-67-7	Contains (regardless of intentional or impurities)	chemical products
10967	Stibine, tris(isooctylthio)acetylthio-	27253-22-1	Contains (regardless of intentional or impurities)	chemical products
10968	Neodecanoic acid, cobalt salt (1:7)	27253-31-2	Intentional addition / 1,000ppm	chemical products
10969	Neodecanoic acid, manganese salt	27253-32-3	Contains (regardless of intentional or impurities)	chemical products
10970	2,2',6',6''-Tetrapyridine, diperschlorate	27289-04-1	Intentional addition / 1,000ppm	chemical products
10971	Acetic acid, mercapto-, isooctyl ester, antimony(3+) salt	27288-44-4	Contains (regardless of intentional or impurities)	chemical products
10972	Polyoxyethylene monotetradecyl ether	27306-79-2	Intentional addition / 1%	chemical products
10973	Vanadium tetrahydride	27318-03-2	Intentional addition / 1%	chemical products
10974	5-Formyl-2-furanylboronic acid	27329-70-0	Intentional addition / 1%	chemical products
10975	1,1-Dibromo-1,2,2,2-tetrafluoroethane	27336-23-8	Intentional addition / 1,000ppm	chemical products
10976	[1,1'-Biphenyl]-2,2'-disulfonic acid, 4,4'-diamino-, disodium salt	27336-24-9	Intentional addition / 1,000ppm	chemical products
10977	Naphthalene, 1,5-bis(1-methylethyl)-	27351-96-8	Intentional addition / 1%	chemical products
10978	Phthalide, 4,5,6,7-tetrachloro-	27355-22-2	Intentional addition / 1%	chemical products
10979	Cuprate(4-), [29H,31H-phthalocyanine-C,C,C,C-tetrasulfonato(6-)-N29,N30,N31,N32]-, tetrasodium	27360-85-6	Intentional addition / 1,000ppm	chemical products
10980	N,N-(dimethylamino)thioacetamide hydrochloride	27366-72-9	Contains (regardless of intentional or impurities)	chemical products
10981	Nicotine, diamminetetakis(isothiocyanato)chromate(1-)	27399-23-1	Contains (regardless of intentional or impurities)	chemical products
10982	Copper(II) fumarate	27405-89-6	Intentional addition / 1,000ppm	chemical products
10983	2,5-Dimethoxy-4-[[p-tolyl]thio]benzenediazonium tetrafluoroborate	27413-92-9	Intentional addition / 1%	chemical products
10984	Chromate(2-), [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-1-naphthalenesulfonato(3-)]-[1-[[2-hydroxy-5-[(2-methoxyphenyl)azo]phenyl]azo]-2-naphthalenolato(2-)]-, disodium	27425-58-7	Contains (regardless of intentional or impurities)	chemical products
10985	Sodium bis[2-[[2-hydroxy-5-nitrophenyl]azo]-4,5-dimethylphenolato(2-)]chromate(1-)	27425-60-1	Contains (regardless of intentional or impurities)	chemical products
10986	Benzoic acid, methyl-, cadmium salt	27476-27-3	Contains (regardless of intentional or impurities)	chemical products
10987	Benzenesulfonic acid, dodecyl-, magnesium salt	27479-45-4	Intentional addition / 1%	chemical products
10988	Strychnidin-10-one, (OC-6-11)-diamminetetakis(thiocyanato-N)chromate(1-)	27498-36-8	Contains (regardless of intentional or impurities)	chemical products
10989	Dibutyl tin oxide polymer	27517-48-2	Intentional addition / 1,000ppm	chemical products
10990	Borate(1-), tetrafluoro-, chromium(3+) (3:1)	27519-39-7	Contains (regardless of intentional or impurities)	chemical products
10991	Boric acid (H3BO3), ammonium salt	27522-09-4	Intentional addition / 1%	chemical products
10992	Manganese arsenate	27526-45-0	Contains (regardless of intentional or impurities)	chemical products
10993	Ammonium molybdenum oxide ((NH4)2Mo2O7)	27546-07-2	Contains (regardless of intentional or impurities)	chemical products
10994	Dioctylbis(oleoyloxy)stannane	27550-52-3	Contains (regardless of intentional or impurities)	chemical products
10995	1-(Acetylamino)-4-bromoanthraquinone	27563-14-0	Contains (regardless of intentional or impurities)	chemical products
10996	Benzenediazonium, 3-methyl-4-(1-pyrrolidinyl)-, hexafluoroarsenate(1-)	27569-09-1	Contains (regardless of intentional or impurities)	chemical products
10997	Nickel, [[2,2'-thiobis(4-(1,1,3,3-tetramethylbutyl)phenolato(2-))-O,O'-S]-	27574-34-1	Contains (regardless of intentional or impurities)	chemical products
10998	1-(Tributylstannyl)-1H-imidazole	27605-35-2	Contains (regardless of intentional or impurities)	chemical products
10999	Sodium sulfide hydrate	27610-45-3	Intentional addition / 1,000ppm	chemical products
11000	Oxirane, 2'-[[1,6-naphthalenedivylbis(oxy)methylene]bis-	27610-48-6	Contains (regardless of intentional or impurities)	chemical products
11001	Cuprate(1-), [C,C,C,C-tris(phenylamino)sulfonyl]-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen	27614-70-6	Intentional addition / 1,000ppm	chemical products
11002	Copper, [C,C,C,C-tetrachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-	27614-71-7	Intentional addition / 1,000ppm	chemical products
11003	Stannane, tributylfluoro-, polymers	27615-98-1	Intentional addition / 1,000ppm	chemical products
11004	Benzenesulfonic acid, undecyl-, sodium salt	27636-75-5	Intentional addition / 1%	chemical products
11005	Nickel isocetanoate	27637-46-3	Contains (regardless of intentional or impurities)	chemical products
11006	1-Octadecanaminium, N,N-dimethyl-N-[3-(trimethoxysilyl)propyl]-, chloride	27668-52-6	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
11007	Sodium dihydro(trithio)borate(1-)	27735-90-6	Intentional addition / 1%	chemical products
11008	Cobaltate(3-), tris(ethanedioato(2-)-O,O)-, tripotassium, hydrate, (OC-6-11)-	27736-00-1	Intentional addition / 1%	chemical products
11009	Borate(1-), tetrafluoro-, indium(3+)(3:1)	27765-48-6	Contains (regardless of intentional or impurities)	chemical products
11010	Vanadyl sulfate	27774-13-6	Contains (regardless of intentional or impurities)	chemical products
11011	Sulfuric acid, potassium tin(2+) salt (2:2:1)	27990-37-0	Contains (regardless of intentional or impurities)	chemical products
11012	2-Propanoic acid, 2-cyano-, 2-methoxyethyl ester	27816-23-5	Contains (regardless of intentional or impurities)	chemical products
11013	Nickel(II) phthalocyaninetetra-sulfonic acid, tetrasodium salt	27835-99-0	Contains (regardless of intentional or impurities)	chemical products
11014	2-Propanoic acid, chromium(3+) salt	27850-15-3	Intentional addition / 1,000ppm	chemical products
11015	Benzene, difluoro-	27858-05-5	Intentional addition / 1,000ppm	chemical products
11016	2,3,7,8,12,13,17,18-Octaethyl-21H,23H-porphine vanadium(IV) oxide	27860-55-5	Intentional addition / 1%	chemical products
11017	Zinc tetrafluoroborate hydrate	27860-55-9	Intentional addition / 1%	chemical products
11018	2-Propanoic acid, 3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10-heptadecafluorodecyl ester	27905-45-9	Contains (regardless of intentional or impurities)	chemical products
11019	Propanenitrile, 3-[ethyl(4-formylphenyl)amino]-	27914-15-4	Intentional addition	chemical products
11020	Sodium 7-aminonaphthalene-1-sulphonate	27931-06-2	Contains (regardless of intentional or impurities)	chemical products
11021	o-Isomonylphenol	27938-31-4	Intentional addition / 1%	chemical products
11022	Nonyxol-10	27942-26-3	Intentional addition / 1,000ppm	chemical products
11023	Butyl-S-benzyl-S-ethyl dithiophosphate	27949-52-6	Intentional addition	chemical products
11024	Bicyclo[2.2.2]oct-5-ene-2,3-dicarboxylic acid, 1-isopropyl-4-methyl-, barium salt (1:1)	27959-78-0	Intentional addition / 1,000ppm	chemical products
11025	Hydrazine perchlorate	27978-54-7	Contains (regardless of intentional or impurities)	chemical products
11026	Cyclohexyl-1,1'-biphenyl	27985-87-1	Intentional addition / 1%	chemical products
11027	Trifluoroethane	27987-06-0	Intentional addition / 1,000ppm	chemical products
11028	Hydrogen tetrachloroaurate hydrate	27988-77-8	Intentional addition	chemical products
11029	Tetrafluorobenzene	28016-01-5	Intentional addition / 1,000ppm	chemical products
11030	Cobalt dinitocinate	28029-53-0	Intentional addition / 1,000ppm	chemical products
11031	Manganese dinitocinate	28029-54-1	Contains (regardless of intentional or impurities)	chemical products
11032	Sulfuric acid, rubidium zinc salt (2:2:1), hexahydrate	28037-77-6	Intentional addition / 1%	chemical products
11033	Sulfuric acid, cadmium sodium salt (2:1:2)	28038-18-8	Intentional addition / 1,000ppm	chemical products
11034	Sulfuric acid, cadmium potassium salt (2:1:2)	28038-25-7	Intentional addition / 1,000ppm	chemical products
11035	Sulfuric acid, nickel(2+) thallium(1+) salt (2:1:2)	28038-27-9	Intentional addition / 1,000ppm	chemical products
11036	Sulfuric acid, copper(2+) thallium(1+) salt (2:1:2)	28038-29-1	Intentional addition / 1%	chemical products
11037	Sulfuric acid, thallium(1+) zinc salt (2:2:1)	28038-30-4	Intentional addition / 1,000ppm	chemical products
11038	Sulfuric acid, cobalt(2+) rubidium salt (2:1:2)	28038-39-3	Intentional addition / 1%	chemical products
11039	Sulfuric acid, rubidium zinc salt (2:2:1)	28041-67-0	Intentional addition / 1%	chemical products
11040	Sulfuric acid, manganese(2+) rubidium salt (2:1:2)	28041-68-1	Contains (regardless of intentional or impurities)	chemical products
11041	Sulfuric acid, cadmium cesium salt (2:1:2)	28041-77-2	Intentional addition / 1,000ppm	chemical products
11042	1-(4-Chlorophenyl)cyclobutanecarbonitrile	28049-61-8	Intentional addition	chemical products
11043	Tributyltin phosphate	28089-34-1	Contains (regardless of intentional or impurities)	chemical products
11044	Trichloropentafluoropropane	28109-69-5	Intentional addition	chemical products
11045	Phosphoric acid, sodium zirconium(4+) salt (2:2:1)	28132-50-5	Contains (regardless of intentional or impurities)	chemical products
11046	Chromium(3+) lithium(1+) silicate (1:1:2)	28155-72-8	Contains (regardless of intentional or impurities)	chemical products
11047	N-tert-Butyl-N-cyclopropyl-6-(methylthio)-1,3,5-triazine-2,4-diamine	28159-98-0	Intentional addition / 100ppm	chemical products
11048	2-Cyano-3-(4-hydroxyphenyl)acrylic acid	28166-41-8	Intentional addition	chemical products
11049	Benzonitrile, 3-(bromomethyl)-	28188-41-2	Intentional addition	chemical products
11050	2-Isopropylamino-4-methylbenzonitrile	28195-00-8	Intentional addition	chemical products
11051	Hydroxylamine, O-methyl-, perchlorate	28219-79-6	Intentional addition / 1,000ppm	chemical products
11052	Benthiocarb	28249-77-6	Contains (regardless of intentional or impurities)	chemical products
11053	Antimonate(2-), bis[mu-(2,3-dihydroxybutanedioato(4-)-O1,O2,O3,O4)]di-, dipotassium, trihydrogen, stereoisomer	28300-74-5	Contains (regardless of intentional or impurities)	chemical products
11054	Cuprate(3-), [18-carboxy-20-(carboxymethyl)-8-ethenyl-13-ethyl-12-formyl-2,3-dihydro-3,7,17-trimethyl-21H,23H-porphine-2-propanoato(5-)-N21,N22,N23,N24]-, trisodium, [SP-4-2-(2S-trans)]-	28302-36-5	Intentional addition / 1,000ppm	chemical products
11055	Potassium trichlorocadmiate monohydrate	28302-54-7	Intentional addition / 1,000ppm	chemical products
11056	Distannoxane, 1,3-dimethyl-1,3-dioxo-	28308-70-5	Contains (regardless of intentional or impurities)	chemical products
11057	Benzenesulfonic acid, tetradecyl-, sodium salt	28348-81-0	Intentional addition / 1%	chemical products
11058	Ethanedioic acid, copper(2+) salt (2:1)	28356-46-9	Intentional addition / 1,000ppm	chemical products
11059	2-Hydroxypropyl 4-oxo-4-[(tributylstannyl)oxy]isocrotonate	28375-10-2	Contains (regardless of intentional or impurities)	chemical products
11060	Stovaine, trioxalatochromate(3-)(3:1), (+)	28376-22-9	Contains (regardless of intentional or impurities)	chemical products
11061	C.I. Direct Blue 218	28407-97-6	Contains (regardless of intentional or impurities)	chemical products
11062	Rhodium, tetra- $\mu$ -3-carbonyldodecacarbonylhexa-, octahedro	28407-51-4	Contains (regardless of intentional or impurities)	chemical products
11063	1-Acetyl-4-methylnaphthalene	28418-86-2	Contains (regardless of intentional or impurities)	chemical products
11064	3,3'-Dichloro-4,4'-diaminodiphenyl ether	28434-86-8	Contains (regardless of intentional or impurities)	chemical products
11065	2,2',3,3',5,5',6,6'-Octafluoro[1,1'-biphenyl]-4,4'-dicarbonitrile	28442-30-0	Intentional addition	chemical products
11066	2-Propanenitrile, 3-(4-methoxyphenyl)-	28446-68-6	Intentional addition	chemical products
11067	Copper, [2,3,9,10,16,17,23,24-octachloro-29H,31H-phthalocyaninato(2-)-kappa N29,kappa N30,kappa N31,kappa N32]-, (SP-4-1)-	28451-28-7	Intentional addition / 1,000ppm	chemical products
11068	Copper, [mu-[[tetrahydrogen 3,3'-jacobis[[2-hydroxy-p-phenylene]azo]]bis[4-hydroxy-6-(m-sulfonamino)-2-naphthalenesulfonato]](4-)]di-, tetrasodium salt	28469-62-7	Intentional addition / 1,000ppm	chemical products
11069	Nonanedioic acid, diisocetyl ester	28472-97-1	Intentional addition / 1,000ppm	chemical products
11070	(R*,S*)-1,2,3,4-Tetrachlorobutane	28507-96-2	Intentional addition / 1,000ppm	chemical products
11071	Disodium dodecylphenyl ether disulfonate	28519-02-0	Intentional addition / 1,000ppm	chemical products
11072	Diisononyl phthalate	28553-12-0	Contains (regardless of intentional or impurities)	chemical products
11073	Copper, [tetra-thiocyanatophthalocyaninato(2-)]-	28553-45-9	Intentional addition / 1,000ppm	chemical products
11074	Cuprate(3-), [5-amino-4-hydroxy-3-[(2-hydroxy-5-sulfophenyl)azo]-2,7-naphthalenedisulfonato(5-)-, trihydrogen	28566-83-8	Intentional addition / 1,000ppm	chemical products
11075	Dodecanoic acid, (dibutylstannylene)bis(thio-2,1-ethanedyl) ester	28570-24-3	Contains (regardless of intentional or impurities)	chemical products
11076	Dodecanoic acid, (diocetylstannylene)bis(thio-2,1-ethanedyl) ester	28570-25-4	Contains (regardless of intentional or impurities)	chemical products
11077	Diethylbiphenyl	28575-17-9	Intentional addition / 1%	chemical products
11078	Barium dodecylbenzenesulphonate	28575-89-5	Contains (regardless of intentional or impurities)	chemical products
11079	Sulphurous acid, gold sodium salt	28600-35-3	Intentional addition	chemical products
11080	Sulphurous acid, gold potassium salt	28600-36-4	Intentional addition	chemical products
11081	Manganese ammonium pyrophosphate	28602-69-9	Contains (regardless of intentional or impurities)	chemical products
11082	Ethane, tetrachlorodifluoro-	28605-74-5	Intentional addition / 1,000ppm	chemical products
11083	4-(Dimethylamino)phenylboronic acid	28611-39-4	Intentional addition / 1%	chemical products
11084	[Tetranitro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	28632-29-3	Intentional addition / 1,000ppm	chemical products
11085	[29H-31H-Phthalocyaninetetraminato(2-)-N29,N30,N31,N32]copper	28632-30-6	Intentional addition / 1,000ppm	chemical products
11086	Citric acid, iron(3+) salt	28633-45-6	Intentional addition / 1%	chemical products
11087	Copper, [N,N,N',N',N'',N''-hexaethyl-29H,31H-phthalocyanine-C,C,C-trimethanaminato(2-)-N29,N30,N31,N32]-	28654-73-1	Intentional addition / 1,000ppm	chemical products
11088	Stannane, dibutylbis(1-oxobutoxy)-	28660-63-1	Contains (regardless of intentional or impurities)	chemical products
11089	Dibutylbis(myristoyloxy)stannane	28660-67-5	Contains (regardless of intentional or impurities)	chemical products
11090	Barium bis[ <i>p</i> -(1,1,3,3-tetramethylbutyl)phenolato]]-	28675-72-1	Contains (regardless of intentional or impurities)	chemical products
11091	Nickel, [29H,31H-phthalocyanine-C,C,C,C-tetrasulfonyl tetrachlorido(2-)-N29,N30,N31,N32]-	28680-76-4	Contains (regardless of intentional or impurities)	chemical products
11092	Bromadiolone	28772-56-7	Contains (regardless of intentional or impurities)	chemical products
11093	Cuprate(3-), [18-carboxy-20-(carboxymethyl)-8-ethenyl-13-ethyl-12-formyl-2,3-dihydro-3,7,17-trimethyl-21H,23H-porphine-2-propanoato(5-)-N21,N22,N23,N24]-, trihydrogen, [SP-4-2-(2S-trans)]-	28777-01-7	Intentional addition / 1,000ppm	chemical products
11094	Dimethylhexane	28777-67-5	Intentional addition / 1%	chemical products
11095	2,5-Furandione, dihydro-3-(octadecenyl)-	28777-98-2	Intentional addition / 100ppm	chemical products
11096	Tribromobenzene	28779-08-0	Intentional addition / 1,000ppm	chemical products
11097	Tributyl(neodecanoxy)stannane	28801-69-6	Contains (regardless of intentional or impurities)	chemical products
11098	Copper, [29H,31H-phthalocyanine-2,9,16,23-tetrasulfonyl tetrachlorido(2-)-N29,N30,N31,N32]-, (SP-4-1)-	28802-09-7	Intentional addition / 1,000ppm	chemical products
11099	Arsenous acid, zinc salt (2:3)	28837-97-0	Contains (regardless of intentional or impurities)	chemical products
11100	Boron, (2,4-dimethylbenzenamine)trifluoro-, (T-4)-	28879-19-8	Intentional addition / 1%	chemical products
11101	2-Chloro-6-methyl-3-pyridine carbonitrile	28900-10-9	Intentional addition	chemical products
11102	Cuprate(1-), [29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen	28901-96-4	Intentional addition / 1,000ppm	chemical products
11103	[5,10,15,20-Tetrakis(4-methoxyphenyl)porphyrinato]cobalt(II)	28903-71-1	Intentional addition / 1%	chemical products
11104	Carbonic dichloride, polymer with 4,4'-(1-methylthylidene)bis[2,6-dibromophenyl]	28906-13-0	Intentional addition / 900ppm	chemical products
11105	Bromochlorobenzene	28906-38-9	Intentional addition / 1,000ppm	chemical products
11106	1-Naphthalenediazonium, tetrafluoroborate(1-)	28912-93-8	Intentional addition / 1%	chemical products
11107	Nickel(II) bromide ethyleneglycol dimethyl ether complex	28923-39-9	Contains (regardless of intentional or impurities)	chemical products
11108	Lanthanum tribromate	28958-23-8	Intentional addition / 1%	chemical products
11109	Gadolinium tribromate	28958-27-2	Intentional addition / 1%	chemical products
11110	Dysprosium tribromate	28958-28-3	Intentional addition / 1%	chemical products
11111	Holmium tribromate	28958-29-4	Intentional addition / 1%	chemical products
11112	Erbium tribromate	28958-30-7	Intentional addition / 1%	chemical products
11113	Lutetium tribromate	28958-31-8	Intentional addition / 1%	chemical products
11114	1,1-Difluoroethylene-trifluoroethylene copolymer	28960-88-5	Intentional addition / 1,000ppm	chemical products
11115	Ytterbium tribromate	28972-23-8	Intentional addition / 1%	chemical products
11116	Antimony arsenate	28980-47-4	Contains (regardless of intentional or impurities)	chemical products
11117	Antimony arsenite	28980-48-5	Contains (regardless of intentional or impurities)	chemical products
11118	antimony, compound with tin (1:1)	28980-49-6	Contains (regardless of intentional or impurities)	chemical products
11119	Nickel, bis[1,2-diphenyl-1,2-ethenedithiolato(2-)-S,S']-, (SP-4-1)-	28984-20-5	Contains (regardless of intentional or impurities)	chemical products
11120	Chlorohexafluoropropane	28987-04-4	Intentional addition / 1,000ppm	chemical products
11121	Barium nonylphenate	28987-17-9	Contains (regardless of intentional or impurities)	chemical products
11122	Nickel(2+) chloride-1,2-dimethoxyethane (1:2:1)	29046-78-4	Contains (regardless of intentional or impurities)	chemical products
11123	Tris(ethylenediamine)cobalt(III) chloride dihydrate	29058-84-2	Intentional addition / 1%	chemical products
11124	Copper, bis[ethano]tetrakis[mu-(2-hydroxybenzoato-O1,O1)]di-, (Cu-Cu)	29058-90-0	Intentional addition / 1,000ppm	chemical products
11125	Benzenesulfonic acid, dodecyl-, compound with pentylamine (1:1)	29061-66-3	Intentional addition / 1%	chemical products
11126	Lithium dodecylbenzenesulphonate	29062-27-9	Intentional addition / 1%	chemical products
11127	Phosphonium, tetrabutyl, tetraphenylborate (1-)	29089-62-1	Intentional addition / 1%	chemical products
11128	Benzene, 2,4-dichloro-1,3-dinitro-5-(trifluoromethyl)-	29091-09-6	Contains (regardless of intentional or impurities)	chemical products
11129	Antimony, compound with thallium (1:1)	29095-38-3	Contains (regardless of intentional or impurities)	chemical products
11130	5-Amino-1-phenyl-1H-pyrazole-4-carboxylic acid methyl ester	29097-01-6	Contains (regardless of intentional or impurities)	chemical products
11131	Pentane, 2-bromo-, (R)-	29117-44-0	Intentional addition / 1,000ppm	chemical products
11132	Propane, 2,3-dibromo-1,1,1,3-tetrafluoro-, threo-	29118-28-3	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
11133	Propane, 2,3-dibromo-1,1,1,3-tetrafluoro-, erythro-	29118-29-4	Intentional addition / 1,000ppm	chemical products
11134	Dodecylhydroxyoxostannane	29134-69-8	Contains (regardless of intentional or impurities)	chemical products
11135	Propane, 2-bromo-1,1,1,3-tetrafluoro-	29151-25-5	Intentional addition / 1,000ppm	chemical products
11136	Barium bis(didodecylbenzenesulphonate)	29152-54-3	Contains (regardless of intentional or impurities)	chemical products
11137	Sodium tetrachloroaurate(III) hydrate	29156-65-8	Intentional addition	chemical products
11138	Perboric acid (H3BO2(O2)), monosodium salt	29158-97-2	Intentional addition / 1%	chemical products
11139	Cuprate(2-), [29H,31H-phthalocyanine-C,C-disulfonato(4-)-N29,N30,N31,N32]-, dihydrogen	29188-28-1	Intentional addition / 1,000ppm	chemical products
11140	l-Proline, 5-oxo-, manganese salt	29183-02-0	Contains (regardless of intentional or impurities)	chemical products
11141	Maleic acid, barium salt	29204-49-1	Contains (regardless of intentional or impurities)	chemical products
11142	Nickel, bis[2,3-bis(hydroxyimino)-N-phenylbutanamidate-N2,N3]-	29204-94-0	Contains (regardless of intentional or impurities)	chemical products
11143	Trimethylbenzene	29222-48-0	Intentional addition / 1%	chemical products
11144	Trimethoxy-methyl	29222-93-7	Contains (regardless of intentional or impurities)	chemical products
11145	Tetrachlorotetrafluoropropane	29255-31-0	Contains (regardless of intentional or impurities)	chemical products
11146	2,3,5,6-Tetrafluoro-7,7,8,8-tetracyanoquinodimethane	29261-33-4	Intentional addition	chemical products
11147	Benzenesulfonic acid, alpha-bromo-2-chloro-	29270-30-2	Contains (regardless of intentional or impurities)	chemical products
11148	Octane, 1,1,1,7-tetrachloro-3,5-dimethyl-, D,DL-	29293-15-0	Intentional addition / 1,000ppm	chemical products
11149	Octane, 1,1,1,7-tetrachloro-3,5-dimethyl-, D,DD-	29293-20-7	Intentional addition / 1,000ppm	chemical products
11150	Octane, 1,1,1,7-tetrachloro-3,5-dimethyl-, D,LD-	29293-21-8	Intentional addition / 1,000ppm	chemical products
11151	Octane, 1,1,1,7-tetrachloro-3,5-dimethyl-, D,LL-	29293-22-9	Intentional addition / 1,000ppm	chemical products
11152	Nickel(II) isooctanoate	29317-83-3	Contains (regardless of intentional or impurities)	chemical products
11153	p-Hydroxybenzenesulfonic acid, compound with aniline (1:1)	29328-30-1	Contains (regardless of intentional or impurities)	chemical products
11154	12-(1,2-Diphenyl-1H-indol-3-yl)vinyl]-1,3,3-trimethyl-3H-pyrrolo[2,3-b]pyridinium perchlorate	29330-29-8	Intentional addition / 1,000ppm	chemical products
11155	Strychnine, mono(cis-1,2-cis-1,3-oxo-meth-3-yl phthalate)	29362-83-2	Contains (regardless of intentional or impurities)	chemical products
11156	Cobaltate(2-), [29H,31H-phthalocyanine-C,C-disulfonato(4-)-N29,N30,N31,N32]-, dihydrogen	29383-29-7	Intentional addition / 1,000ppm	chemical products
11157	Ethene, chloro-, polymer with trichloroethene	29406-20-0	Intentional addition / 1,000ppm	chemical products
11158	Silane, triethoxyvinyl-, polymer with boric acid (H3BO3)	29407-88-3	Intentional addition / 1%	chemical products
11159	6-Selenoguanosine	29411-74-3	Contains (regardless of intentional or impurities)	chemical products
11160	Zinc chloride, tetrahydrate	29426-92-4	Intentional addition / 1,000ppm	chemical products
11161	2,3-Dichlorodibenzo-p-dioxin	29446-15-9	Intentional addition / 1,000ppm	chemical products
11162	Tributyl(undec-10-enyloxy)stannane	29457-48-5	Contains (regardless of intentional or impurities)	chemical products
11163	Heptanoic acid, 2,2,3,3,4,4,5,5,6,6,7,7,7-dodecafluoro-6-(trifluoromethyl)-, potassium salt (1:1)	29457-73-6	Intentional addition / 100ppm	chemical products
11164	Hexachlorofluoropropane	29470-94-8	Intentional addition / 1,000ppm	chemical products
11165	Tetrachlorotrifluoropropane	29470-95-9	Intentional addition / 1,000ppm	chemical products
11166	2-Chloro-5-phenylthiophene	29488-24-2	Contains (regardless of intentional or impurities)	chemical products
11167	3-methoxybutyl 11,11-dibutyl-3-methyl-7-oxo-2,6-dioxo-10,12-dithia-11-stannapentadecan-15-olate	29492-49-7	Contains (regardless of intentional or impurities)	chemical products
11168	Hafnium 182	29492-85-1	Contains (regardless of intentional or impurities)	chemical products
11169	1,4-Bis(2,3-epoxypropoxymethyl)benzene	29513-13-1	Contains (regardless of intentional or impurities)	chemical products
11170	2-Decene, 2-bromo-, (Z)-	29550-61-6	Intentional addition / 1,000ppm	chemical products
11171	5,7,12-Trioxa-6-stannahexadeca-2,9-dienoic acid, 6,6-dioctyl-4,8,11-trioxo-, butyl ester, (Z,Z)-	29575-02-8	Contains (regardless of intentional or impurities)	chemical products
11172	2-Butene, 1-bromo-, (E)-	29576-14-5	Contains (regardless of intentional or impurities)	chemical products
11173	1-Butene, 1-bromo-2,3,3-trimethyl-	29586-12-7	Intentional addition / 1,000ppm	chemical products
11174	Toluene, dibenzyl derivative	29589-57-9	Intentional addition / 1%	chemical products
11175	Zinc chloride, hydrate	29604-34-0	Intentional addition / 1,000ppm	chemical products
11176	Hydrogen bis[N-(7-hydroxy-8-[[2-hydroxy-5-mesylphenyl]azo]-1-naphthyl]cobaltate(1-)	29616-23-7	Intentional addition / 1,000ppm	chemical products
11177	Propanoic acid, 2-chloro-, (S)-	29617-66-1	Contains (regardless of intentional or impurities)	chemical products
11178	L-Alanine, 3,3'-diselenobis-	29621-88-3	Contains (regardless of intentional or impurities)	chemical products
11179	Dihydrogen tetrachloro-mu-hydroxydihydroxy(mu-stearato)dichromate(2-)	29632-23-3	Contains (regardless of intentional or impurities)	chemical products
11180	Antimony potassium oxide (Sb2K4O7)	29638-69-5	Contains (regardless of intentional or impurities)	chemical products
11181	Naphthalimide, N-[3-(dimethylamino)propyl]-4-methoxy-, monoperoxchlorate	29641-60-9	Intentional addition / 1,000ppm	chemical products
11182	Antimony, compound with samarium (1:1)	29648-84-4	Contains (regardless of intentional or impurities)	chemical products
11183	1,3-Propanediol, 2,2-dimethyl-, cyclic ester with boric acid (H3BO3)	29668-15-3	Intentional addition / 1%	chemical products
11184	Benzeneselenazolium, 2-methyl-3-(3-sulfopropyl)-, inner salt	29680-54-4	Contains (regardless of intentional or impurities)	chemical products
11185	1-Bromo-2,4,5-trichlorobenzene	29682-28-3	Intentional addition / 1,000ppm	chemical products
11186	Hafnium 184	29687-28-3	Contains (regardless of intentional or impurities)	chemical products
11187	Chromium carbonate	29689-14-3	Intentional addition / 1,000ppm	chemical products
11188	Naphthalene, decahydro(1-methylethyl)-, trans-	29690-50-4	Intentional addition	chemical products
11189	Polymer(ethylene tetrachloroethylene-propylene)	29697-44-7	Intentional addition / 1,000ppm	chemical products
11190	1-Dececanilium, N,N-didodecyl-N-methyl-, perchlorate	29711-00-0	Intentional addition / 1,000ppm	chemical products
11191	Copper, [C,C-trichloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-	29719-96-8	Intentional addition / 1,000ppm	chemical products
11192	2,5,7,10,11,14-Hexaoxa-1,6-distibabicyclo[4,4,4]tetradecane	29738-75-2	Contains (regardless of intentional or impurities)	chemical products
11193	Cadmium hydroxide hydrate	29738-89-8	Contains (regardless of intentional or impurities)	chemical products
11194	Bromopentane	29756-38-5	Intentional addition / 1,000ppm	chemical products
11195	Heptane, bromo-	29756-39-6	Intentional addition / 1,000ppm	chemical products
11196	Benzenesulfonic acid, dodecyl-, aluminum salt	29756-98-7	Intentional addition / 1,000ppm	chemical products
11197	Isodecyl diphenyl phosphate	29761-21-5	Intentional addition / 1,000ppm	chemical products
11198	[Tetrakis(perfluorooheptyl)-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	29763-53-9	Intentional addition / 1,000ppm	chemical products
11199	Manganese ricinoleate	29789-06-8	Contains (regardless of intentional or impurities)	chemical products
11200	Nicotinic acid, salicylate	29790-52-1	Contains (regardless of intentional or impurities)	chemical products
11201	Benzidine perchlorate	29806-76-6	Contains (regardless of intentional or impurities)	chemical products
11202	Thallium hydrogen carbonate	29809-42-5	Contains (regardless of intentional or impurities)	chemical products
11203	Isononanoic acid, manganese salt	29826-51-5	Contains (regardless of intentional or impurities)	chemical products
11204	Platinate(2-), hexanitro-, disodium	29830-84-0	Contains (regardless of intentional or impurities)	chemical products
11205	Telluric acid (H2TeO3), aluminum salt (3:2)	29853-65-4	Contains (regardless of intentional or impurities)	chemical products
11206	Acetic acid, [(dibutyl)distannoxanediydene]tetrahydro-, tetraisoctyl ester	29859-88-9	Intentional addition / 1,000ppm	chemical products
11207	Cobalt arsenate	29871-10-1	Contains (regardless of intentional or impurities)	chemical products
11208	Arsenic acid, copper(2+) salt	29871-13-4	Contains (regardless of intentional or impurities)	chemical products
11209	Barium molybdenum oxide (BaMoO7)	29879-10-5	Intentional addition / 1,000ppm	chemical products
11210	(Z)-Octadeca-9-enyl (all-Z)-6,6-dibutyl-4,8,11-trioxo-5,7,12-trioxo-6-stannatriaconta-2,9,21-trienoate	29881-72-9	Contains (regardless of intentional or impurities)	chemical products
11211	Pentane, 2-bromo-, (S)-	29882-58-4	Intentional addition / 1,000ppm	chemical products
11212	Amygdalin	29883-15-6	Intentional addition	chemical products
11213	N-Methylanilinium trifluoroacetate	29885-95-8	Intentional addition	chemical products
11214	Hydrogen tetrasodium bis(dihydrogen 7-[[4-chloro-6-[N-(sulphomethyl)anilino]-s-triazin-2-yl]amino]-3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]naphthalene-1-sulphonato(2-))chromate(1-)	29890-29-7	Contains (regardless of intentional or impurities)	chemical products
11215	2(3H)-Benzothiazolethione, cobalt(2+) salt	29904-98-1	Intentional addition / 1,000ppm	chemical products
11216	Hydroxydimethyltin oleate	29910-14-3	Intentional addition / 1,000ppm	chemical products
11217	Arsenate(1-), hexafluoro-, lithium	29935-35-1	Contains (regardless of intentional or impurities)	chemical products
11218	1,5,7-Octatriene-3-ol, 3,7-dimethyl-	29957-43-5	Intentional addition / 1%	chemical products
11219	Boron, tribromo[thiobis(methane)]-, (T-4)-	29957-59-3	Intentional addition / 1%	chemical products
11220	Copper, tetraamminedichloro-	29961-99-7	Intentional addition / 1,000ppm	chemical products
11221	Ethiofencarb	29973-13-5	Contains (regardless of intentional or impurities)	chemical products
11222	Cobalt ricinoleate	29973-37-3	Intentional addition / 1%	chemical products
11223	N,N-Ethylenebis(glycinato-O,N)cobalt	29977-10-4	Intentional addition / 1,000ppm	chemical products
11224	Cadmium, [[N-(1,2-ethanediybis(glycinato))2]-N,N',O,O']-, (T-4)-	29977-13-7	Contains (regardless of intentional or impurities)	chemical products
11225	Hydrogen bis[2,4-dihydro-4-[[2-hydroxy-5-mesylphenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]cobaltate(1-)	29988-71-8	Intentional addition / 1,000ppm	chemical products
11226	Rhodium(II) acetate dimer	29988-99-0	Contains (regardless of intentional or impurities)	chemical products
11227	Manganese(2+) hydrogen orthoborate	30031-44-8	Contains (regardless of intentional or impurities)	chemical products
11228	Tetradecane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,12-pentacosafuoro-14-iodo-	30046-31-2	Contains (regardless of intentional or impurities)	chemical products
11229	Bis(dimethylidithiocarbamate)tin	30051-58-2	Contains (regardless of intentional or impurities)	chemical products
11230	Copper, [dihydrogen 4-[[2-hydroxy-5-[[2-hydroxyethyl]sulfonyl]phenyl]azo]-5-oxo-1-(p-sulphophenyl)-2-pyrazoline-3-carboxylate(2-)]-, mono(hydrogen sulfate) (ester)	30053-43-1	Intentional addition / 1,000ppm	chemical products
11231	4,4'-Bis(trichloromethyl)bishenyl	30061-79-1	Contains (regardless of intentional or impurities)	chemical products
11232	Stannane, (secaboxydi)oxybis(tributyl-)	30099-72-0	Contains (regardless of intentional or impurities)	chemical products
11233	Chromate(1-), bis[3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen	30112-70-0	Contains (regardless of intentional or impurities)	chemical products
11234	Decane, bromo-	30141-69-6	Intentional addition / 1,000ppm	chemical products
11235	Chloroheptafluoropropane	30143-46-5	Intentional addition	chemical products
11236	Barium bis(octylphenolate)	30259-97-3	Contains (regardless of intentional or impurities)	chemical products
11237	Dimethylhydrazine	30260-66-3	Intentional addition / 1,000ppm	chemical products
11238	Copper L-aspartate	30272-90-3	Intentional addition / 1,000ppm	chemical products
11239	D-Ribulose 1,5-bisphosphate	30276-82-5	Intentional addition	chemical products
11240	Ethane, bromotetrafluoro-	30283-90-0	Intentional addition	chemical products
11241	Bromotrifluoroethane	30283-91-1	Intentional addition	chemical products
11242	Hexadecane, bromo-	30286-29-4	Intentional addition / 1,000ppm	chemical products
11243	1-(Chloromethyl)-2-(dichloromethyl)benzene	30293-58-4	Contains (regardless of intentional or impurities)	chemical products
11244	Pentane, 1-bromo-2,4,4-trimethyl-	30295-24-0	Intentional addition / 1,000ppm	chemical products
11245	Cadmium isooctanoate	30304-32-6	Contains (regardless of intentional or impurities)	chemical products
11246	Pentane, 2-bromo-4-methyl-	30310-22-6	Intentional addition / 1,000ppm	chemical products
11247	2-Hexene, 6-bromo-2-methyl-	30316-02-0	Intentional addition / 1,000ppm	chemical products
11248	Cadmate(2-), [[N-(1,2-ethanediybis[N-(carboxy-kappa O)methyl]glycinato-kappa N,kappa O)](4-)]-, sodium (1:2)	30363-28-1	Contains (regardless of intentional or impurities)	chemical products
11249	1-Butanethiol, tin salt	30383-06-3	Intentional addition / 1,000ppm	chemical products
11250	Butanedioic acid, 2,3-dihydroxy-[R-(R*,R*)]-, iron(3+) salt	30386-85-7	Intentional addition / 1%	chemical products
11251	3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,12-Henicosafluorododecene	30389-25-4	Intentional addition / 100ppm	chemical products
11252	Stannate(2-), hexachloro-, (OC-6-11)-, dinitrolyl	30406-43-0	Contains (regardless of intentional or impurities)	chemical products
11253	1-Benzopyrylium, 4-(butylamino)-2-(4-methoxyphenyl)-, tetrafluoroborate(1-)	30411-66-6	Intentional addition / 1%	chemical products
11254	(m-Aminophenyl)metaboric acid	30418-59-8	Intentional addition / 1%	chemical products
11255	Vanadium hydroxide oxide	30486-37-4	Contains (regardless of intentional or impurities)	chemical products
11256	Bisphenol, 4,4'-(1-methylethylidene)tetrahydro-	30496-13-0	Intentional addition / 900ppm	chemical products
11257	Paraformaldehyde	30525-89-4	Contains (regardless of intentional or impurities)	chemical products
11258	Butane, 1-bromo-2,3-dimethyl-	30540-31-9	Intentional addition / 1,000ppm	chemical products
11259	Acephate	30560-19-1	Contains (regardless of intentional or impurities)	chemical products
11260	Decane, 3-bromo-	30571-71-2	Intentional addition / 1,000ppm	chemical products
11261	Dichloropentane	30586-10-8	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
11262	(1:1) Compound of 2-[(C8-18-alkylamino)-1-substituted propane and hydrogen bis[1-[(2-hydroxy-6-nitrophenyl)azo]-2-naphthalenolato(2-)]cobaltate(1-), branched or linear heptyl derivatives	30621-99-9	Intentional addition / 1%	chemical products
11263	Sulfuric acid, cadmium potassium salt (2:1:2), hexahydrate	30623-04-2	Intentional addition / 1,000ppm	chemical products
11264	Cobaltate(1-), [29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen	30638-08-5	Intentional addition / 1,000ppm	chemical products
11265	Cuprate(3-), [29H,31H-phthalocyanine-C,C,C-trisulfonato(5-)-N29,N30,N31,N32]-, trihydrogen	30638-09-6	Intentional addition / 1,000ppm	chemical products
11266	Cuprate(4-), [29H,31H-phthalocyanine-C,C,C,tetrakisulfonato(6-)-N29,N30,N31,N32]-, tetrapotassium	30638-10-9	Intentional addition / 1,000ppm	chemical products
11267	Copper, [29H,31H-phthalocyanine-C-disulfonyl dichloridato(2-)-N29,N30,N31,N32]-	30644-11-2	Intentional addition / 1,000ppm	chemical products
11268	N-Cyanotriethylammonium tetrafluoroborate	30684-36-7	Intentional addition / 1%	chemical products
11269	Oxotriphenoxovanadium	30707-37-0	Intentional addition / 1%	chemical products
11270	Antimonate (SbO3 <sup>1-</sup> ), sodium, monohydrate	30718-75-3	Intentional addition / 1,000ppm	chemical products
11271	Sulfuric acid, ammonium indium(3+) salt (2:1:1)	30734-38-4	Intentional addition / 1,000ppm	chemical products
11272	Dichromium trioxalate	30737-19-0	Intentional addition / 1,000ppm	chemical products
11273	Thallium oxalate	30737-24-7	Intentional addition / 1,000ppm	chemical products
11274	Borate(1-), tetrafluoro-, manganese(2+) (2:1)	30744-82-2	Contains (regardless of intentional or impurities)	chemical products
11275	1,2,3,4-Tetrachlorodibenzodioxin	30746-58-8	Intentional addition / 1,000ppm	chemical products
11276	4-Hydroxybenzene-1,2-dicarbonitrile	30757-50-7	Intentional addition	chemical products
11277	Benzene sulfonic acid, tetradecyl-	30776-59-1	Intentional addition / 1%	chemical products
11278	Chromate(2-), [3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]-1-naphthalenesulfonato(3-)]-[1-[(2-hydroxy-5-[(p-methoxyphenyl)azo]phenyl)azo]-2-naphthalato(2-)]-, disodium	30785-74-1	Contains (regardless of intentional or impurities)	chemical products
11279	Ethyl butanoate, compound with trifluoroborate (1:1)	30844-74-7	Intentional addition / 1%	chemical products
11280	Barium zinc orthosilicate (1:2:1)	30848-25-0	Intentional addition / 1,000ppm	chemical products
11281	2-[(Tributylstannyl)thio]pyridine 1-oxide	30860-66-3	Contains (regardless of intentional or impurities)	chemical products
11282	Magnesium hexafluorozirconate(2-)	30868-50-9	Contains (regardless of intentional or impurities)	chemical products
11283	Calcium hexafluorozirconate(2-)	30868-51-0	Contains (regardless of intentional or impurities)	chemical products
11284	Zirconate(2-), hexafluoro-, nickel(2+) (1:1), (OC-6-11)-	30868-55-4	Contains (regardless of intentional or impurities)	chemical products
11285	Cadmium 104	30905-38-5	Contains (regardless of intentional or impurities)	chemical products
11286	Butanedioic acid, sulfo-, 1,4-bis(2-ethylhexyl)ester, barium salt	30910-35-1	Intentional addition / 1,000ppm	chemical products
11287	Beryllium oxide	30913-98-5	Contains (regardless of intentional or impurities)	chemical products
11288	Phosphorodithioic acid, O,O-dibutyl ester, antimony(3+) salt	30927-36-7	Contains (regardless of intentional or impurities)	chemical products
11289	Zirconium formate	30937-72-5	Contains (regardless of intentional or impurities)	chemical products
11290	Phosphonic acid, [[3,5-bis(1,1-dimethylethyl)-4-hydroxyphenyl]methyl]-, monoethyl ester, nickel(2+) salt (2:1)	30947-30-9	Contains (regardless of intentional or impurities)	chemical products
11291	Tris[2-(2-methoxyethoxy)ethoxy]ethyl orthoborate	30989-05-0	Intentional addition / 1%	chemical products
11292	Ethanol, 2-(2-butoxyethoxy)-, triester with boric acid (H3BO3)	30989-06-1	Intentional addition / 1%	chemical products
11293	Tris[2-(2-ethoxyethoxy)ethoxy]ethyl borate	30989-07-2	Intentional addition / 1%	chemical products
11294	Cadmium dodecylbenzenesulfonate	31017-44-4	Contains (regardless of intentional or impurities)	chemical products
11295	Octane, 1,1,1,7-tetrachloro-3,5-dimethyl-, (3R*,5R*,7R*)	31031-25-1	Intentional addition / 1,000ppm	chemical products
11296	Octane, 1,1,1,7-tetrachloro-3,5-dimethyl-, heterotactic	31031-26-2	Intentional addition / 1,000ppm	chemical products
11297	Stannane, dibutylbis[(isooctylthio)acetyl]oxy-	31045-95-1	Contains (regardless of intentional or impurities)	chemical products
11298	Rubidium selenide (Rb2Se)	31052-43-4	Contains (regardless of intentional or impurities)	chemical products
11299	Cesium selenide (Cs2Se)	31052-46-7	Contains (regardless of intentional or impurities)	chemical products
11300	Tetraamine copper dinitrate	31058-64-7	Intentional addition / 1,000ppm	chemical products
11301	1,2-Ethanediamine, N,N,N',N'-tetramethyl-, polymer with 1,1'-oxybis[2-chloroethane]	31075-24-8	Intentional addition / 100ppm	chemical products
11302	2-Propanol, chromium(3+) salt	31087-39-5	Contains (regardless of intentional or impurities)	chemical products
11303	2,2,2'-Nitrilotriethanol, copper salt	31089-39-1	Intentional addition / 1,000ppm	chemical products
11304	Benzene sulfonic acid, decyl-	31093-47-7	Intentional addition / 1%	chemical products
11305	Aurate(1-), bis(cyano-C)-, ammonium	31096-40-9	Contains (regardless of intentional or impurities)	chemical products
11306	Cuprate(2-), [4-hydroxy-3-[(2-hydroxy-4-nitrophenyl)azo]-6-[(3-sulfophenyl)amino]-2-naphthalenesulfonato(4-)]-, disodium	31102-54-2	Intentional addition / 1,000ppm	chemical products
11307	Pentaamine(nitro-N)rhodium dinitrate	31105-57-4	Contains (regardless of intentional or impurities)	chemical products
11308	Octane, 1,1,1,7-tetrachloro-3,5-dimethyl-, (3R*,5S*,7R*)	31107-32-1	Intentional addition / 1,000ppm	chemical products
11309	Phosphoric acid, barium salt	31142-87-7	Intentional addition / 1,000ppm	chemical products
11310	Cadmium (1,1-dimethylethyl)benzoate	31215-94-8	Contains (regardless of intentional or impurities)	chemical products
11311	Propetaphos	31218-83-4	Contains (regardless of intentional or impurities)	chemical products
11312	Copper [1,2,3,4,8,9,10,11,15,16,17,18,22,23,24-pentadecachlorophthalocyaninato(2-)]-	31235-28-6	Intentional addition / 1,000ppm	chemical products
11313	Benzyltriphenylphosphonium tetrafluoroborate	31240-52-5	Contains (regardless of intentional or impurities)	chemical products
11314	Hexachlorodiphenyl oxide	31242-93-0	Contains (regardless of intentional or impurities)	chemical products
11315	Polymethacrylic acid copper salt	31243-88-6	Intentional addition / 1,000ppm	chemical products
11316	Nicotine, pivalate (1:2)	31269-83-7	Contains (regardless of intentional or impurities)	chemical products
11317	Copper, [C,C-bis(chloromethyl)-29H,31H-phthalocyaninato(2-)-kappa.N29,kappa.N30,kappa.N31,kappa.N32]-	31278-57-6	Intentional addition / 1,000ppm	chemical products
11318	Cuprate(4-), [29H,31H-phthalocyanine-C,C,C,C-tetrakisulfonato(6-)-N29,N30,N31,N32]-, barium (1:2)	31278-65-6	Intentional addition / 1,000ppm	chemical products
11319	Chromium, aqua[2-(3-(2,5-dihydroxyphenyl)-1-oxopropyl)cyclopentanato(2-)]-[2-[(2-hydroxy-5-nitrophenyl)imino]methyl]-3,5-dipropoxyphenolato(2-)]-	31303-42-1	Intentional addition / 1,000ppm	chemical products
11320	Nonane, 1-bromo-4,4,8,8-tetramethyl-	31334-81-3	Intentional addition / 1,000ppm	chemical products
11321	tert-Butyl(methoxy)phenol	31345-37-6	Intentional addition / 1%	chemical products
11322	Cuprate(2-), [C,C-bis(chlorosulfonyl)-29H,31H-phthalocyanine-C,C-disulfonato(4-)-N29,N30,N31,N32]-, dihydrogen	31361-57-6	Intentional addition / 1,000ppm	chemical products
11323	Dibromodifluoroethane	31392-96-8	Intentional addition / 1,000ppm	chemical products
11324	Isoheptane	31394-54-4	Contains (regardless of intentional or impurities)	chemical products
11325	Aurate(1-), tetrakis(cyano-C)-, sodium, (SP-4-1)-	31395-95-6	Contains (regardless of intentional or impurities)	chemical products
11326	Tetrabenzylhafnium	31406-67-4	Intentional addition / 1%	chemical products
11327	Barium dibutylate	31416-33-8	Contains (regardless of intentional or impurities)	chemical products
11328	Butene, 1,4-dichloro-	31423-92-4	Intentional addition / 1,000ppm	chemical products
11329	[(Tetrachlorophthalyl)bis(oxy)]bis(tributylstannane)	31430-86-1	Contains (regardless of intentional or impurities)	chemical products
11330	1,3-Propanediol, 2,2-bis(bromomethyl)-, polymer with (chloromethyl)oxirane	31452-80-9	Contains (regardless of intentional or impurities)	chemical products
11331	Tetrabromocyclooctane	31454-48-5	Intentional addition / 900ppm	chemical products
11332	Iron triaurate	31494-35-6	Intentional addition / 1%	chemical products
11333	(E)-1-Bromohex-4-ene	31502-25-7	Intentional addition / 1,000ppm	chemical products
11334	trans-4-Heptenyl bromide	31502-26-8	Intentional addition / 1,000ppm	chemical products
11335	4-Octene, 1-bromo-, (E)-	31502-27-9	Intentional addition / 1,000ppm	chemical products
11336	2-Octene, 8-bromo-, (E)-	31502-28-0	Intentional addition / 1,000ppm	chemical products
11337	Polymeric zinc propylene bis(dithiocarbamate)	31530-30-0	Intentional addition / 1%	chemical products
11338	Cobaltate(1-), bis[1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphthalenolato(2-)]-, hydrogen	31586-68-2	Intentional addition / 1,000ppm	chemical products
11339	Phosphoric acid, diethyl ester, chromium(3+) salt	31636-06-3	Intentional addition / 1,000ppm	chemical products
11340	1,2-Benzenedicarbonitrile, 4-nitro-	31643-49-9	Intentional addition	chemical products
11341	2-Propenoic acid, 2-methyl-, 9-anthracenylmethyl ester	31645-35-9	Contains (regardless of intentional or impurities)	chemical products
11342	Stannane, (isothiocyanato)tripropyl-	31709-32-7	Contains (regardless of intentional or impurities)	chemical products
11343	5,7,9-Trioxa-6,8-distantrideca-2,11-dienedioic acid, 6,6,8,8-tetrabutyl-4,10-dioxo-, didodecyl ester, (Z,Z)-	31710-35-7	Intentional addition / 1,000ppm	chemical products
11344	Chromate(1-), bis[1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphthalenolato(2-)]-, hydrogen	31714-55-3	Contains (regardless of intentional or impurities)	chemical products
11345	1-Pentene, 2-bromomethyl-, 4,4-dimethyl-	31736-87-1	Intentional addition / 1,000ppm	chemical products
11346	Silicic acid (H2SiO3), nickel(2+) salt (4:3)	31748-25-1	Contains (regardless of intentional or impurities)	chemical products
11347	Sulfuric acid, manganese(2+) salt (2:1)	31754-55-9	Intentional addition / 1%	chemical products
11348	Sulfuric acid, manganese(2+) salt (4:1)	31754-56-0	Intentional addition / 1%	chemical products
11349	Tetrasodium [mu-[[3,3'-azobis(12-hydroxy-p-phenylene)azo]]bis[4-hydroxy-6-(3-sulphoanilino)naphthalene-2-sulphonato]](8-)]dicuprate(4-)	31765-95-4	Intentional addition / 1,000ppm	chemical products
11350	Dibromostyrene	31780-26-4	Intentional addition / 900ppm	chemical products
11351	Dibutyltin bis(3-mercaptopropionic acid butoxyethyl ester)	31781-13-2	Intentional addition / 1,000ppm	chemical products
11352	Disiloxanol, 3,3'-[1,7-dicarbadodecaborane(12)-1,7-diyl]bis[1,1,3,3-tetramethyl-	31783-54-7	Intentional addition / 1%	chemical products
11353	Oxalic acid, tantalum(5+) salt (5:2)	31791-37-4	Intentional addition / 1,000ppm	chemical products
11354	Octane, 1-bromo-4-ethyl-4,7,7-trimethyl-	31841-76-6	Intentional addition / 1,000ppm	chemical products
11355	1-Pentene, 2-bromo-	31844-95-8	Intentional addition / 1,000ppm	chemical products
11356	2-Bromo-3-methyl-1-butene	31844-96-9	Intentional addition / 1,000ppm	chemical products
11357	2-Bromo-4-methylpent-1-ene	31844-97-0	Intentional addition / 1,000ppm	chemical products
11358	1-Butene, 1-bromo-	31844-98-1	Intentional addition / 1,000ppm	chemical products
11359	1-Pentene, 1-bromo-, (Z)-	31849-75-9	Intentional addition / 1,000ppm	chemical products
11360	1-Pentene, 1-bromo-, (E)-	31849-76-0	Intentional addition / 1,000ppm	chemical products
11361	1-Pentene, 1-bromo-4-methyl-, (Z)-	31849-77-1	Intentional addition / 1,000ppm	chemical products
11362	cis-1-Bromo-1-butene	31849-78-2	Intentional addition / 1,000ppm	chemical products
11363	Bis(ethylcyclopentadienyl)nickel(II)	31866-51-8	Contains (regardless of intentional or impurities)	chemical products
11364	Platinum(4+), tris(1,2-propanediamine-N,N)-, tetrachloride	31894-74-3	Contains (regardless of intentional or impurities)	chemical products
11365	Thiocyclam	31895-21-3	Intentional addition / 1%	chemical products
11366	Thiocyclam hydrogen oxalate	31895-22-4	Contains (regardless of intentional or impurities)	chemical products
11367	Ferrocene, butyl-	31904-29-7	Intentional addition / 1%	chemical products
11368	Chloro(cyclopentadienyl)triphosphine(nickel)(II)	31904-79-7	Contains (regardless of intentional or impurities)	chemical products
11369	(3-Bromophenyl)acetone nitrile	31938-07-5	Contains (regardless of intentional or impurities)	chemical products
11370	1-Butene, 4-bromo-3-methyl-	31950-55-7	Intentional addition / 1,000ppm	chemical products
11371	1-Pentene, 4-bromo-	31950-56-8	Intentional addition / 1,000ppm	chemical products
11372	Acetate, S,S-bis(octylmercapto)-, dibutyltin	32011-18-0	Contains (regardless of intentional or impurities)	chemical products
11373	Tin, dibutylbis(methyl 3-mercaptopropionate-O,S)-	32011-19-1	Contains (regardless of intentional or impurities)	chemical products
11374	Benzylhydrazinium oxalate (1:1)	32064-65-6	Intentional addition	chemical products
11375	N,N-Bis(salicylidene)-o-phenylenediamine vanadium(IV) oxide complex	32065-17-1	Intentional addition / 1%	chemical products
11376	(S)-2,3,5,6-Tetrahydro-6-phenylimidazo[2,1-b]thiazotriptylium phosphate	32093-35-9	Intentional addition / 1%	chemical products
11377	Boron, (3-aminophenyl-N)trifluoro-, (T-4)-	32153-96-1	Intentional addition / 1%	chemical products
11378	Octanoic acid, 2,2-dimethyl-, copper(2+) salt	32276-75-8	Intentional addition / 1,000ppm	chemical products
11379	Poly(hexamethylenebiguanide hydrochloride)	32289-58-0	Contains (regardless of intentional or impurities)	chemical products
11380	Diphenyl ditelluride	32294-60-3	Contains (regardless of intentional or impurities)	chemical products
11381	2-Naphthaleneboronic acid	32316-92-0	Intentional addition / 1%	chemical products
11382	Zirconium telluride (ZrTe2)	32321-65-6	Contains (regardless of intentional or impurities)	chemical products
11383	Tris(1,2-dimethylpropyl)borane	32327-52-9	Intentional addition / 1,000ppm	chemical products
11384	Dichlorobis(1,1'-thiobis[butane])platinum	32335-93-6	Contains (regardless of intentional or impurities)	chemical products
11385	Acetylacetonato(norbornadiene)rhodium(I)	32354-50-0	Contains (regardless of intentional or impurities)	chemical products
11386	Fluorescein mercuric acetate	32382-27-7	Contains (regardless of intentional or impurities)	chemical products



(Appendix table 1) MISUMI Specified Chemical Substances

Ver.2.0.0 date of revision 5/31/2022 Misumi Corporation

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
11387	1-Decanaminium, N,N-dimethyl-N-octyl-, chloride	32426-11-2	Intentional addition / 1,000ppm	chemical products
11388	Sulfuric acid, cobalt(2+) nickel(2+) salt (2:1:1)	32441-17-1	Contains (regardless of intentional or impurities)	chemical products
11389	Pentane, 3-(bromomethyl)-2-methyl-	32444-35-2	Intentional addition / 1,000ppm	chemical products
11390	p-Dimethylamino)cinnamitrile	32444-63-6	Intentional addition	chemical products
11391	Boric acid, tetrasodium salt	32446-62-1	Intentional addition / 1%	chemical products
11392	2,5-Cyclohexadiene-1,4-dione, 2,5-dichloro-3,6-dihydroxy-, barium salt (1:1), trihydrate	32458-20-1	Intentional addition / 1,000ppm	chemical products
11393	Cobalt nitrite	32468-57-0	Intentional addition / 1%	chemical products
11394	2,5-Dioxo-8,10-dithia-9-stannadodecan-12-oxo acid, 9,9-dibutyl-6-oxo-, 2-methoxyethyl ester	32509-49-2	Intentional addition / 1,000ppm	chemical products
11395	2-(3H)-Benzothiazolethione, copper salt	32510-27-3	Intentional addition / 1,000ppm	chemical products
11396	Titanium molybdate	32512-08-6	Intentional addition / 1%	chemical products
11397	Aluminum hydroxide (Al2MgO6)	32512-11-1	Intentional addition / 1%	chemical products
11398	Ammonium antimony fluoride	32516-50-0	Contains (regardless of intentional or impurities)	chemical products
11399	Chromate(1-), bis[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, hydrogen, (OC-6-22)-	32517-36-5	Contains (regardless of intentional or impurities)	chemical products
11400	Hydrogen bis[1-[(2-hydroxy-4-nitrophenyl)azo]naphthalen-2-olato(2-)]cobaltate(1-)	32517-38-7	Intentional addition / 1,000ppm	chemical products
11401	Decane, heptachloro-	32534-78-4	Intentional addition / 1,000ppm	chemical products
11402	Zirconate(3-), tris(carbonato(2-)-O)hydroxy-, triammonium, (T-4)-	32535-84-5	Contains (regardless of intentional or impurities)	chemical products
11403	Octabromodiphenyl ether	32536-52-0	Contains (regardless of intentional or impurities)	chemical products
11404	Borate(1-), difluorodihydroxy-	32554-52-2	Intentional addition / 1%	chemical products
11405	Borate(1-), fluorodihydroxy-	32554-53-3	Intentional addition / 1%	chemical products
11406	Copper, [[N,N'-1,2-ethanediy]bis[glycinate]](2-)-N,N',O,O']-	32575-57-8	Intentional addition / 1,000ppm	chemical products
11407	Ethylene bis(tetrabromophthalimide)	32588-76-4	Intentional addition / 900ppm	chemical products
11408	Ammonium triiodocadmate	32593-99-0	Intentional addition / 1,000ppm	chemical products
11409	1,2-Dibromo-1-chloropropane	32595-09-8	Intentional addition / 1,000ppm	chemical products
11410	trans-1-Bromo-1-butene	32620-08-9	Intentional addition / 1,000ppm	chemical products
11411	Bis[4-hydroxyosalicylate(2-)-O1,O2]cuprate(2-)	32628-05-0	Intentional addition / 1,000ppm	chemical products
11412	6H-1,3,2-Oxathiastannin-6-one, dihydro-2,2-dimethyl-	32673-05-5	Contains (regardless of intentional or impurities)	chemical products
11413	Arsenic acid (H3AsO4), ammonium copper(2+) salt (1:1:1)	32680-29-8	Contains (regardless of intentional or impurities)	chemical products
11414	5-Nitroindole	32692-19-6	Contains (regardless of intentional or impurities)	chemical products
11415	Barium hydroxide, pentahydrate	32694-96-5	Contains (regardless of intentional or impurities)	chemical products
11416	4-(1,1-Dimethylethyl)benzene-1,2-dicarbonitrile	32703-80-3	Intentional addition	chemical products
11417	Bromochloro-5,5-dimethylimidazolidine-2,4-dione	32718-18-6	Intentional addition / 1,000ppm	chemical products
11418	Trifluoropropene	32718-30-2	Intentional addition / 1,000ppm	chemical products
11419	Cycloheptanecarbonitrile	32730-85-1	Contains (regardless of intentional or impurities)	chemical products
11420	Sodium bis[2-[(2-hydroxy-3,5-dinitrophenyl)azo]-4-methyl-1-naphtholato(2-)]chromate(1-)	32732-14-2	Contains (regardless of intentional or impurities)	chemical products
11421	Iron(1+), (eta.5-2,4-cyclopentadien-1-yl)[(1,2,3,4,5,6-eta.)-(1-methylethyl)benzene]-, tetrafluoroborate(1-)	32760-75-1	Intentional addition / 1%	chemical products
11422	Iron(1+), (eta.5-2,4-cyclopentadien-1-yl)[(1,2,3,4,5,6-eta.)-(1-methylethyl)benzene]-, hexafluorophosphate(1-)	32760-80-8	Contains (regardless of intentional or impurities)	chemical products
11423	Europium arsenide (EuAs)	32775-46-5	Contains (regardless of intentional or impurities)	chemical products
11424	Thallium vanadium oxide (Tl3VO4)	32777-32-5	Intentional addition / 1%	chemical products
11425	Benzenamine, 4,4'-carbonimidoylbis[N,N-dimethyl-, benzenesulfonate	32783-54-3	Contains (regardless of intentional or impurities)	chemical products
11426	2-Ethoxyethyl cyanoacetate	32804-77-6	Intentional addition	chemical products
11427	Copper glycinate	32817-15-5	Intentional addition / 1,000ppm	chemical products
11428	3-Ethyl-2-[3-(3-ethyl-3H-benzoselenazol-2-ylidene)prop-1-enyl]benzoxazolium iodide	32835-25-9	Contains (regardless of intentional or impurities)	chemical products
11429	3-Ethyl-2-[3-(3-ethyl-3H-benzoselenazol-2-ylidene)prop-1-enyl]benzothiazolium iodide	32835-32-8	Contains (regardless of intentional or impurities)	chemical products
11430	1,1'-Ferrocenediboronic acid	32841-83-1	Intentional addition / 1%	chemical products
11431	Carbonic dichloride, polymer with 4,4'-(1-methylethylidene)bis[2,6-dibromopheno] and 4,4'-(1-methylethylidene)bis[pheno]	32844-27-2	Intentional addition / 900ppm	chemical products
11432	Aluminum borate	32867-90-6	Intentional addition / 1,000ppm	chemical products
11433	Carbonic acid, barium strontium salt	32915-78-9	Intentional addition / 1,000ppm	chemical products
11434	Carbonic acid, barium calcium strontium salt	32915-79-0	Intentional addition / 1,000ppm	chemical products
11435	p-Toluidine, nitrate	32954-54-4	Intentional addition / 2%	chemical products
11436	Disubstituted benzenesulfonic acid salt nickel complex	32990-64-0	Contains (regardless of intentional or impurities)	chemical products
11437	1,1'-Dineopentylferrocene	32994-87-3	Intentional addition / 1%	chemical products
11438	Bis(tert-butylcyclopentadienyl)hafnium(IV) dichloride	33010-55-8	Intentional addition / 1%	chemical products
11439	Fumaric acid, copper salt	33010-91-2	Intentional addition / 1,000ppm	chemical products
11440	Decane, 1,1,10,10-tetrachloro-	33025-70-6	Intentional addition / 1,000ppm	chemical products
11441	Methylcyclopentadienylmolybdenum(I) tricarbonyl dimer	33058-03-0	Intentional addition / 1%	chemical products
11442	Strychnidin-10-one, compound with (S)-alpha-methylbenzene acetate	33069-04-4	Contains (regardless of intentional or impurities)	chemical products
11443	Amtraz	33089-81-1	Contains (regardless of intentional or impurities)	chemical products
11444	Carbonic acid, ammonium copper salt	33113-08-5	Intentional addition / 1,000ppm	chemical products
11445	2,2-Dimethyl-6-nitro-2H-chromene	33143-28-1	Contains (regardless of intentional or impurities)	chemical products
11446	3H-1,2,4-Triazole-3-selone, 1,2-dihydro-5-methyl-	33144-86-4	Contains (regardless of intentional or impurities)	chemical products
11447	Potassium, (trichlorostannyl)-, monohydrate	33220-53-0	Intentional addition / 1,000ppm	chemical products
11448	2-Chloroisocyanotinonitrile	33252-30-1	Contains (regardless of intentional or impurities)	chemical products
11449	Chromate(1-), bis[2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazolo(3-onato(2-))-hydrogen	33270-70-1	Contains (regardless of intentional or impurities)	chemical products
11450	Bis[4-(2-hydroxy-4-nitrophenylazo)-3-methyl-1-phenyl-5-pyrazolo(2-cobalt(III) acid	33270-74-5	Contains (regardless of intentional or impurities)	chemical products
11451	Cuprate(2-), bis(hydrazine-N)bis(sulfato(2-)-O)-, dihydrogen	33271-65-7	Intentional addition / 1,000ppm	chemical products
11452	1-Butene, 2-(bromomethyl)-3-methyl-	33355-55-4	Intentional addition / 1,000ppm	chemical products
11453	C.I. Direct Brown 25	33363-87-0	Intentional addition / 100ppm	chemical products
11454	1,4-Benzenediamine, 2-methyl-	33379-31-6	Intentional addition / 1%	chemical products
11455	Copper arsenite	33382-64-8	Contains (regardless of intentional or impurities)	chemical products
11456	(Z)-1,1,3,3-Tetra-tert-butyl-1,3-bis[(3-carboxyacyloxy)oxy]distannoxanedidocyl ester	33397-45-4	Intentional addition / 1,000ppm	chemical products
11457	Distannathiane, dimethyldithio-	33397-79-4	Contains (regardless of intentional or impurities)	chemical products
11458	1,3,6,8-Tetrachlorodibenzo-p-dioxin	33423-92-6	Intentional addition / 1,000ppm	chemical products
11459	Barium bromide, monohydrate	33429-48-0	Intentional addition / 1,000ppm	chemical products
11460	3-(3-Chloro-4-(chlorodifluoromethyl)thiophenyl)-1,1-dimethylurea	33439-45-1	Intentional addition	chemical products
11461	Diammonium tetrachloromercurate	33445-15-7	Contains (regardless of intentional or impurities)	chemical products
11462	(3-Chloropropyl)diphenylsulfonium tetrafluoroborate	33462-80-5	Intentional addition / 1%	chemical products
11463	Cyclopropylidiphenylsulfonium tetrafluoroborate	33462-81-6	Intentional addition / 1%	chemical products
11464	5,12-Trioxa-6-stannatetracos-2,9-dienoic acid, 6,6-dibutyl-4,8,11-trioxo-, dodecyl ester, (Z,Z)-	33466-31-8	Contains (regardless of intentional or impurities)	chemical products
11465	Copper, [N,N,N'-tris[3-(dimethylamino)propyl]-29H,31H-phthalocyanine-C,C,C-trisulfonamido(2-)-N29,N30,N31,N32]-	33481-16-2	Intentional addition / 1,000ppm	chemical products
11466	Chrome complex salt of 2-(2-hydroxy-4-nitrophenylazo) acetoacetanilide	33518-89-7	Intentional addition / 1,000ppm	chemical products
11467	Tributyltin gamma-chlorobutylate	33550-22-0	Contains (regardless of intentional or impurities)	chemical products
11468	Diocetyl tin bis(isooctyl maleate)	33568-99-9	Contains (regardless of intentional or impurities)	chemical products
11469	Iodomethylcyclopropane	33574-02-6	Contains (regardless of intentional or impurities)	chemical products
11470	Benzoselenazolium, 3-ethyl-2-[3-(3-ethyl-2-thiazolidinylidene)-1-propenyl]-, iodide	33609-19-7	Contains (regardless of intentional or impurities)	chemical products
11471	Propanenitrile, 3-[[3-pyridinyl(methyl)amino]-	33611-48-2	Intentional addition	chemical products
11472	Cyclohexylmethylmercuric chloride	33631-63-9	Contains (regardless of intentional or impurities)	chemical products
11473	1H-Indole, 1-acetyl-2,3-dihydro-5-nitro-	33632-27-8	Contains (regardless of intentional or impurities)	chemical products
11474	Nickel carbonyl (Ni(CO))	33637-76-2	Contains (regardless of intentional or impurities)	chemical products
11475	Nickel carbonyl (Ni(CO)2)	33637-77-3	Contains (regardless of intentional or impurities)	chemical products
11476	Heptanoic acid, copper salt	33643-73-1	Intentional addition / 1,000ppm	chemical products
11477	Barium strontium disulfate	33660-69-2	Intentional addition / 1,000ppm	chemical products
11478	Iron(1+), tricarboxylate(1,2,3,4,5-eta.)-2,4-cyclohexadien-1-yl-, tetrafluoroborate(1-)	33678-91-2	Intentional addition / 1,000ppm	chemical products
11479	1,1,2,2-Tetrachloro-1,1,2,2-tetraethane	33685-54-0	Intentional addition / 1,000ppm	chemical products
11480	1-Butene, 2-bromo-3-methyl-	33693-77-5	Intentional addition / 1,000ppm	chemical products
11481	Acetic acid, 2,2'-[(1,1,3-tributyl-1-distannathianyl-3-ylidene)tris(thio)]tris-, triisooctyl ester	33703-04-7	Contains (regardless of intentional or impurities)	chemical products
11482	1-Butanaminium, N,N,N'-tributyl-, tetrahydroborate(1-)	33725-74-5	Intentional addition / 1%	chemical products
11483	Tin hydroxide (Sn(OH))	33754-29-9	Contains (regardless of intentional or impurities)	chemical products
11484	Cuprate(4-), [5-(acetylamino)-4-hydroxy-3-[[[1-hydroxy-6-sulfo-[8-[[2-(sulfoxy)ethyl]sulfonyl]-2-naphthalenyl]azo]-2,7-naphthalenedisulfonato(6-)]-, tetrahydrogen	33773-63-6	Intentional addition / 1,000ppm	chemical products
11485	1,3-Benzenediamine, 5-chloro-	33786-89-9	Contains (regardless of intentional or impurities)	chemical products
11486	2,7-Dichlorodibenzo-p-dioxin	33857-26-0	Intentional addition / 1,000ppm	chemical products
11487	2,3,7-Trichlorodibenzo-p-dioxin	33857-28-2	Intentional addition / 1,000ppm	chemical products
11488	Copper(4+), [[N,N,N',N'-[29H,31H-phthalocyaninetrityl]trakis(methylenedioxy)dimethylamino)methylidene]]trakis[N-methylmethanaminiumato]](2-)-N29,N30,N31,N32-, tetrachloride	33864-99-2	Intentional addition / 1,000ppm	chemical products
11489	Malonic acid, barium salt	33876-10-3	Contains (regardless of intentional or impurities)	chemical products
11490	[[(2'-Thiobis(3-octylphenolato)](2-)-O,O']S]nickel	33882-09-6	Contains (regardless of intentional or impurities)	chemical products
11491	1,3-Dioxane, 2-(2-bromoethyl)-	33884-43-4	Intentional addition / 1%	chemical products
11492	Antimonate (Sb(OH)6-), sodium, (OC-6-11)-	33908-66-6	Contains (regardless of intentional or impurities)	chemical products
11493	Fluorosulphuric acid, compound with antimony pentafluoride (4:1)	33910-86-0	Contains (regardless of intentional or impurities)	chemical products
11494	Iron(2+) diheptanoate	33911-71-6	Intentional addition / 1%	chemical products
11495	Aniline, hydrogen phosphite	33921-12-9	Contains (regardless of intentional or impurities)	chemical products
11496	Zinc tris(acetato-O)dioxouranate	33959-50-1	Contains (regardless of intentional or impurities)	chemical products
11497	Cobalt trinitrate hexahydrate	33960-07-5	Intentional addition / 1%	chemical products
11498	Ferric methanarsonic acid	33972-75-7	Intentional addition / 1%	chemical products
11499	Sulfonium, ethoxydimethyl-, tetrafluoroborate(1-)	33991-41-2	Intentional addition / 1%	chemical products
11500	Antimony nickel oxide (Sb2NiO4)	33992-50-6	Contains (regardless of intentional or impurities)	chemical products
11501	Bis(triethylenephosphine)copper tetrahydroborate	34010-85-0	Intentional addition / 1,000ppm	chemical products
11502	Hexanoic acid, 2-ethyl-, molybdenum salt	34041-09-3	Contains (regardless of intentional or impurities)	chemical products
11503	Strontium dipicrate	34069-88-0	Contains (regardless of intentional or impurities)	chemical products
11504	Dichlorotrifluoroethanes	34077-87-7	Intentional addition / 1,000ppm	chemical products
11505	Fructose, 1-(dihydrogen phosphate), barium salt, D-	34079-63-5	Contains (regardless of intentional or impurities)	chemical products
11506	1,3-Isobenzofuranone, tetrahydro-5-methyl-	34090-76-1	Contains (regardless of intentional or impurities)	chemical products
11507	Ethyl borate	34099-73-5	Intentional addition / 1%	chemical products
11508	Cadmium [R-(R*(R*))]-tartrate	34100-40-8	Contains (regardless of intentional or impurities)	chemical products
11509	2-Hexene, 1-bromo-3-methyl-	34102-04-0	Intentional addition / 1,000ppm	chemical products
11510	Titanate(2-), hexafluoro-, nickel(2+), (1:1), (OC-6-11)-	34109-80-3	Contains (regardless of intentional or impurities)	chemical products
11511	3-(4-Isopropylphenyl)-1,1-dimethylurea	34123-59-6	Contains (regardless of intentional or impurities)	chemical products
11512	N-(p-Cyanobenzylidene)-p-ethoxyaniline	34128-02-4	Intentional addition	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
11513	Diocetyl stearate	34152-36-8	Contains (regardless of intentional or impurities)	chemical products
11514	Trithallium hexacyanochromate	34156-26-8	Intentional addition / 1%	chemical products
11515	Carbonic acid, manganese(2+) salt (1:1), hydrate	34156-69-9	Contains (regardless of intentional or impurities)	chemical products
11516	Chromium triphosphate decahydrate	34215-66-2	Intentional addition / 1,000ppm	chemical products
11517	Cobalt chloride (CoCl <sub>2</sub> )	34240-80-7	Intentional addition / 1%	chemical products
11518	1,4-Benzenedicarboxylic acid, cobalt salt	34262-88-9	Intentional addition / 1,000ppm	chemical products
11519	1,4-Benzenedicarboxylic acid, copper salt	34262-89-0	Intentional addition / 1,000ppm	chemical products
11520	Stannate(2-), tetrachloro- dipotassium, (T-4)-	34275-60-0	Intentional addition / 1,000ppm	chemical products
11521	Quinoline, 1-ethyl-2-[[3-(4-sulfobutyl)-2(3H)-benzoxazolylidene]methyl]-, inner salt	34276-89-6	Contains (regardless of intentional or impurities)	chemical products
11522	Vanadate (VO4 <sup>3-</sup> ), tricesium, (T-4)-	34283-89-7	Intentional addition / 1%	chemical products
11523	Phosphoric acid, monopentyl ester, barium salt (1:1)	34296-07-6	Contains (regardless of intentional or impurities)	chemical products
11524	Docosanoic acid, titanium salt	34303-23-6	Contains (regardless of intentional or impurities)	chemical products
11525	Nickel chloride (NiCl <sub>2</sub> ), tetrahydrate	34304-82-0	Contains (regardless of intentional or impurities)	chemical products
11526	Sulfuric acid, cadmium cesium salt (2:1:2), hexahydrate	34345-39-6	Intentional addition / 1,000ppm	chemical products
11527	Bis(acetylacetonato)molybdenum	34346-27-5	Intentional addition / 1%	chemical products
11528	2-methoxyethyl (Z,Z)-11,11-dibutyl-6,9,13-trioxo-2,5,10,12-tetraoxa-11-stannahexadeca-7,14-dien-16-oate	34349-21-8	Contains (regardless of intentional or impurities)	chemical products
11529	Phosphoric acid, sodium zirconium(4+) salt (2:1:1)	34370-53-1	Contains (regardless of intentional or impurities)	chemical products
11530	Formaldehyde, polymer with N-methylmethanamine and phenol	34378-36-4	Intentional addition / 1%	chemical products
11531	Poly(oxy-1,2-ethanediy), alpha-pentadecyl-omega-hydroxy-	34398-05-5	Intentional addition / 1%	chemical products
11532	Sulphuric acid, chromium sodium salt	34415-65-1	Intentional addition / 1,000ppm	chemical products
11533	Phenethylboronic acid	34420-17-2	Intentional addition / 1%	chemical products
11534	Tetrachloro-mu-methacrylate-mu-oxidochromium	34430-82-5	Intentional addition / 1,000ppm	chemical products
11535	Silver(1+), diammine-, fluoride	34445-07-3	Contains (regardless of intentional or impurities)	chemical products
11536	Magnesium dichromate (MgCr <sub>2</sub> O <sub>7</sub> ) hexahydrate	34448-20-9	Intentional addition / 1,000ppm	chemical products
11537	Isononane	34464-40-9	Intentional addition / 1,000ppm	chemical products
11538	Hexachlorodibenzodioxin	34465-46-8	Contains (regardless of intentional or impurities)	chemical products
11539	Bis(3,5-diisopropylsilylato-O1,O2)hydroxychromium	34481-85-1	Intentional addition / 1,000ppm	chemical products
11540	Nickel monoxide	34492-97-2	Contains (regardless of intentional or impurities)	chemical products
11541	Dichromic acid, sodium salt	34493-01-1	Contains (regardless of intentional or impurities)	chemical products
11542	1-Octene, polymer with chloroethene	34514-27-7	Intentional addition / 1,000ppm	chemical products
11543	Antimony sodium tartrate	34521-09-0	Contains (regardless of intentional or impurities)	chemical products
11544	Sodium [alpha.alpha.-(ethylenediimino)bis(2-hydroxy-5-methylbenzene-1-acetoxy)](4-)]ferrate(1-)	34541-04-3	Intentional addition / 1%	chemical products
11545	Trimethylacetic acid, anhydride with diethylboronic acid	34574-27-1	Intentional addition / 1%	chemical products
11546	Propanol, 1(or 2)-(2-methoxyethylthioxy)-	34590-94-8	Contains (regardless of intentional or impurities)	chemical products
11547	O-(2,4-Dichlorophenyl) O-ethyl S-propyl dithiophosphate	34643-46-4	Intentional addition / 1%	chemical products
11548	5-Chloro-2-nitrobenzonitrile	34662-31-2	Intentional addition	chemical products
11549	Cobaltate(1-), bis[3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-hydroxybenzenesulfonamidato(2-)]-, sodium, (OC-6-22)-	34664-47-6	Intentional addition / 1,000ppm	chemical products
11550	2-Hexene, 1-bromo-	34686-76-5	Intentional addition / 1,000ppm	chemical products
11551	2-Heptene, 1-bromo-	34686-77-6	Intentional addition / 1,000ppm	chemical products
11552	2,4,6-Trimethylphenylacetone	34688-71-6	Contains (regardless of intentional or impurities)	chemical products
11553	Tribromoacetyl chloride	34718-47-3	Contains (regardless of intentional or impurities)	chemical products
11554	Telluric acid (H <sub>2</sub> TeO <sub>4</sub> ), dicesium salt	34729-54-9	Contains (regardless of intentional or impurities)	chemical products
11555	Cobaltate(1-), bis[2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-N-(2-chlorophenyl)-3-oxobutan amidato(2-)]-, sodium	34735-28-9	Intentional addition / 1,000ppm	chemical products
11556	Trichloro(N,N-dimethylbenzylamine)boron	34762-89-5	Intentional addition / 1%	chemical products
11557	Boron, trichloro(N,N-dimethyl-1-octanamine)-, (T-4)-	34762-90-8	Intentional addition / 1%	chemical products
11558	Cuprate(3-), [mu-[[4-[[3,3'-dihydroxy-4-[[2-hydroxy-6-sulfo-1-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-3'-hydroxy-2,7-naphthalenedisulfonato(7-)]]]di- trihydrogen	34771-63-6	Intentional addition / 1,000ppm	chemical products
11559	Monoborate of 2,2-dimethyl-1,3-propanediol	34776-99-3	Intentional addition / 1%	chemical products
11560	1,2,7,8-Tetrachlorodibenzo-p-dioxin	34816-53-0	Intentional addition / 1,000ppm	chemical products
11561	Thallium, 2,4-cyclopentadiene-1-yl-	34822-90-7	Contains (regardless of intentional or impurities)	chemical products
11562	Hydrogen [N,N-bis(carboxymethyl)glycinate(3-)-N.O.O.']cuprate(1-)	34831-02-2	Intentional addition / 1,000ppm	chemical products
11563	Nickelate(1-), [N,N-bis(carboxymethyl)glycinate(3-)-N.O.O.']-, hydrogen, (T-4)-	34831-03-3	Contains (regardless of intentional or impurities)	chemical products
11564	Iodo(trimethyl phosphite-p)copper	34836-53-8	Intentional addition / 1,000ppm	chemical products
11565	Bromoselenobenzene	34837-55-3	Contains (regardless of intentional or impurities)	chemical products
11566	[Carbonato(2-)-O]oxozirconium	34842-61-0	Contains (regardless of intentional or impurities)	chemical products
11567	Quinoline-3-carbonitrile	34846-64-5	Intentional addition	chemical products
11568	1,1,2,2,4-Pentachlorobutane	34867-74-8	Intentional addition / 1,000ppm	chemical products
11569	Tetrasodium [8-hydroxy-7-[[2-(2-hydroxy-5-methyl-4-[[3-[[2-(sulphoxy)ethyl]sulphonyl]phenyl]azo]phenyl]azo]naphthalene-1,3,6-trisulphonato(6-)]]cuprate(4-)	34870-85-4	Intentional addition / 1,000ppm	chemical products
11570	Acetic acid, 2,2',2''-[[thio]bis[butylstannylidene]bis(thio)]]tetrakis-, tetraisooctyl ester	34871-84-6	Contains (regardless of intentional or impurities)	chemical products
11571	Diisopropylammonium nitrite	34915-40-7	Intentional addition / 1,000ppm	chemical products
11572	Copper(II) trifluoromethanesulphonate	34946-82-2	Intentional addition / 1,000ppm	chemical products
11573	4-Cyano(hydroxyimino)methyl-1-methylpyridinium iodide	35013-90-2	Intentional addition / 1,000ppm	chemical products
11574	Sodium 2-(1-methylpropyl)-4,6-dinitrophenolate	35040-03-0	Contains (regardless of intentional or impurities)	chemical products
11575	Undecane, 5-(bromomethyl)-2,2,4,8,10,10-hexamethyl-	35071-89-7	Intentional addition / 1,000ppm	chemical products
11576	Phosphoric acid, beryllium salt	35089-00-0	Contains (regardless of intentional or impurities)	chemical products
11577	Cesium hydroxide, monohydrate	35103-79-8	Intentional addition / 1,000ppm	chemical products
11578	Tin dipalmitate	35104-88-2	Contains (regardless of intentional or impurities)	chemical products
11579	Thiosulfuric acid (H <sub>2</sub> S <sub>2</sub> O <sub>3</sub> ), barium salt (1:1)	35112-53-9	Contains (regardless of intentional or impurities)	chemical products
11580	Methylthioacetone	35120-10-6	Intentional addition	chemical products
11581	3-Hexene, 1-bromo-4-ethyl-	35128-16-6	Intentional addition / 1,000ppm	chemical products
11582	Bis(1,5-cyclooctadiene)rhodium(II) tetrafluoroborate	35138-22-8	Contains (regardless of intentional or impurities)	chemical products
11583	Arsenic moniodide	35171-52-9	Contains (regardless of intentional or impurities)	chemical products
11584	1-Nonene, 9-bromo-6,6-dimethyl-	35194-21-9	Intentional addition / 1,000ppm	chemical products
11585	Hexanoic acid, 3,5,5-trimethyl-, copper(2+) salt	35206-70-3	Intentional addition / 1,000ppm	chemical products
11586	Propyl bromoacetate	35223-80-4	Contains (regardless of intentional or impurities)	chemical products
11587	Diethyl 2,3-dicyanofumarate	35234-88-9	Intentional addition	chemical products
11588	Pyridinium, 1-butyl-4-hydroxy-2,6-dimethyl-, perchlorate (salt)	35247-09-7	Intentional addition / 1,000ppm	chemical products
11589	Copper, [C,C-dichloro-29H,31H-phthalocyaninato(2-)-N <sub>29</sub> N <sub>30</sub> N <sub>31</sub> N <sub>32</sub> ]-	35254-77-4	Intentional addition / 1,000ppm	chemical products
11590	Butanol, all isomers	35296-72-1	Contains (regardless of intentional or impurities)	chemical products
11591	Copper dodec-10-enoate	35322-29-3	Intentional addition / 1,000ppm	chemical products
11592	2-Nonene, 1-bromo-, (2E)-	35329-43-2	Intentional addition / 1,000ppm	chemical products
11593	2-Undecene, 1-bromo-, (E)-	35329-44-3	Intentional addition / 1,000ppm	chemical products
11594	Mixture of (dichlorophosphino)biphenyl (mixture) and 2(or 3 or 4),2'(or 3' or 4')-bis(dichloro phosphino)biphenyl (mixture)	35346-33-9	Contains (regardless of intentional or impurities)	chemical products
11595	2-Heptene, 1-bromo-, (E)-	35349-80-5	Intentional addition / 1,000ppm	chemical products
11596	Bis(2-nitrophenyl) diselenide	35350-43-7	Contains (regardless of intentional or impurities)	chemical products
11597	Hexane, 1-bromo-5-methyl-	35354-37-1	Intentional addition / 1,000ppm	chemical products
11598	C.I. Pigment Red 63:2	35355-77-2	Contains (regardless of intentional or impurities)	chemical products
11599	Sulprofos	35400-43-2	Intentional addition / 1%	chemical products
11600	6-Hydroxy-2H-pyran-3(6H)-one	35406-57-8	Contains (regardless of intentional or impurities)	chemical products
11601	1,3-Isobenzofurandione, 3a,4,7,7a-tetrahydro-4-methyl-, (3aR,4R,7aS)-rel-	35438-81-4	Intentional addition / 1%	chemical products
11602	1,3-Isobenzofurandione, 3a,4,7,7a-tetrahydro-4-methyl-, (3aR,4S,7aS)-rel-	35438-82-5	Intentional addition / 1%	chemical products
11603	rel-(3aR,4R,7aS)-4-Methyl-3a,4,7,7a-tetrahydroisobenzofuran-1,3-dione	35438-84-7	Intentional addition / 1%	chemical products
11604	Benzene, 1,2-diisocyanatomethyl-	35465-61-3	Intentional addition / 1%	chemical products
11605	2-[[5-(6-Dimethoxy-3-(3-sulphonatopropyl)-(3H)-benzoxazol-2-ylidene)methyl]but-1-enyl]-3-ethyl-5,6-dimethylbenzoxazolium	35498-95-4	Contains (regardless of intentional or impurities)	chemical products
11606	Vanadium telluride (VTe <sub>2</sub> )	35515-91-4	Contains (regardless of intentional or impurities)	chemical products
11607	(E)-3-(Dimethylamino)-2-propenenitrile	35520-41-3	Intentional addition	chemical products
11608	Cyclohexanecarboxylic acid, manganese(2+) salt	35542-88-2	Contains (regardless of intentional or impurities)	chemical products
11609	4-Pyrrolidin-1-ylbutyronitrile	35543-25-0	Intentional addition	chemical products
11610	Imazallil	35554-44-0	Contains (regardless of intentional or impurities)	chemical products
11611	(Di-tert-butyl)dimethylstannane	35569-11-0	Contains (regardless of intentional or impurities)	chemical products
11612	Boric acid (HBO <sub>2</sub> ), sodium salt, octahydrate	35585-58-1	Intentional addition / 1%	chemical products
11613	L-Alanine, gamma-(hydroxymethylphosphinyl)-L-alpha-aminobutryl-L-alanyl-	35597-43-4	Intentional addition	chemical products
11614	Hexanoic acid, 2,3,4,4,5,5,6,6-decafluoro-2-(1,1,2,2,2-pentafluoroethyl)-	35605-76-6	Intentional addition / 1,000ppm	chemical products
11615	1-(3-Cyano-3,3-diphenylpropyl)-4-phenylpiperidine-4-carboxylic acid monohydrochloride	35607-36-4	Intentional addition	chemical products
11616	Chlorodibenzol[e][1,4]dioxin	35656-51-0	Intentional addition / 1,000ppm	chemical products
11617	Cadmium chloride, monohydrate	35658-65-2	Contains (regardless of intentional or impurities)	chemical products
11618	Zirconate(2-), oxobis(sulfato(2-)-O)-, dihydrogen	35674-39-6	Contains (regardless of intentional or impurities)	chemical products
11619	Pentanedinitrile, 2-bromo-2-(bromomethyl)-	35691-65-7	Intentional addition / 1,000ppm	chemical products
11620	N-(4-Cyanophenyl)acetamide	35704-19-9	Intentional addition	chemical products
11621	Trihydrogen [2-[[4-[[6-[(4-amino-6-chloro-1,3,5-triazin-2-yl)methylamino]-1-hydroxy-3-sulpho-2-naphthyl]azo]-5-hydroxy-o-tolyl]azo]benzene-1,4-disulphonato(5-)]cuprate(3-)	35718-34-4	Intentional addition / 1,000ppm	chemical products
11622	Neodecanoic acid, antimony(3+) salt	35724-06-2	Contains (regardless of intentional or impurities)	chemical products
11623	Tetrairon octasodium pentakis(pyrophosphate)	35725-46-3	Intentional addition / 1%	chemical products
11624	Arsenic acid, methyl-, ammonium iron(III) salt	35745-11-0	Contains (regardless of intentional or impurities)	chemical products
11625	Copper, [tetraphenyl 29H,31H-phthalocyanine-C.C.C.C-tetrasulfonato(2-)-N <sub>29</sub> N <sub>30</sub> N <sub>31</sub> N <sub>32</sub> ]-	35745-23-4	Intentional addition / 1,000ppm	chemical products
11626	Dicopper sulphite	35788-00-2	Intentional addition / 1,000ppm	chemical products
11627	Disodium [[N,N-ethylenebis[N-(carboxymethyl)glycinate]](4-)-N,N,O,O,ON,ON]cadmate(2-)	35803-35-1	Contains (regardless of intentional or impurities)	chemical products
11628	1,2,3,4,6,7,8-Heptachlorodibenzo-p-dioxin	35822-46-9	Intentional addition / 1,000ppm	chemical products
11629	1-Octene, 8-bromo-6,6-dimethyl-	35826-52-9	Intentional addition / 1,000ppm	chemical products
11630	Vanadium butyl phosphate	35837-52-6	Intentional addition / 1%	chemical products
11631	Dibutyl hydrogen phosphate, vanadium salt	35837-53-7	Intentional addition / 1%	chemical products
11632	Aluminium(III) tris(monomethyl methylphosphonate)	35851-62-8	Intentional addition / 1,000ppm	chemical products
11633	Tercyclohexyl	35860-22-1	Intentional addition / 1%	chemical products
11634	Naphthalene, tris(1-methylthio)-	35860-37-8	Intentional addition / 1%	chemical products
11635	Nickel, tetrakis(tris(methylphenyl) phosphite-P)-	35884-66-3	Contains (regardless of intentional or impurities)	chemical products
11636	D-Gluconic acid, tin(2+) salt (2:1)	35984-19-1	Contains (regardless of intentional or impurities)	chemical products
11637	Themiviphos	35996-61-3	Intentional addition / 1%	chemical products
11638	Nickel bisphosphinate	36026-88-7	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
11639	1,3,5-Tribromo-2-(2,3-dibromo-2-methylpropoxy)benzene	36065-30-2	Intentional addition / 1%	chemical products
11640	Pentachlorodibenzo-p-dioxin	36088-22-9	Intentional addition / 1,000ppm	chemical products
11641	Cuprate(3-), [3-[[[2,4-dihydroxy-3-[[[2-hydroxy-5-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]phenyl]azo]-1,5-naphthalenedisulfonato(5-)]-], trihydrogen	36090-21-8	Intentional addition / 1,000ppm	chemical products
11642	Isohexadecane, bromo-	36117-00-7	Intentional addition / 1,000ppm	chemical products
11643	Propanoic acid, 3,3,3'-[[[butylstannylidene]tris(thio)tris-, triisooctyl ester	36118-60-2	Contains (regardless of intentional or impurities)	chemical products
11644	N-Formyl-L-phenylglycine strychnine salt	36123-89-0	Contains (regardless of intentional or impurities)	chemical products
11645	Vanadium propan-2-olate	36139-34-1	Intentional addition / 1%	chemical products
11646	Borane, chlorobis(1-methylpropyl)-	36140-17-7	Intentional addition / 1%	chemical products
11647	Borane, chlorodicyclohexyl-	36140-17-7	Intentional addition / 1%	chemical products
11648	Nitric acid, nickel(2+) praseodymium(3+) salt (12:3:2), tetracosahydrate	36153-28-3	Intentional addition / 1,000ppm	chemical products
11649	Bis(dipentylidithiocarbamate-S,S')copper	36190-66-6	Intentional addition / 1,000ppm	chemical products
11650	Barium 3,5,5-trimethylhexanoate	36211-43-5	Contains (regardless of intentional or impurities)	chemical products
11651	Cadmium 3,5,5-trimethylhexanoate	36211-44-6	Contains (regardless of intentional or impurities)	chemical products
11652	Iron(2+) palmitate	36215-91-5	Intentional addition / 1%	chemical products
11653	Chloro[2,2',2''-nitritotris[ethanolato]-N,O,O']cobalt	36217-04-6	Intentional addition / 1,000ppm	chemical products
11654	Chromium(3+) sodium disulphate	36221-85-5	Contains (regardless of intentional or impurities)	chemical products
11655	Tributyltin ethoxide	36253-76-6	Intentional addition / 1,000ppm	chemical products
11656	Boron trichloride-methanol reagent	36254-91-8	Intentional addition / 1%	chemical products
11657	Nickel, bis(dipentylcarbamodithioato-S,S')-, (SP-4-1)-	36259-37-7	Contains (regardless of intentional or impurities)	chemical products
11658	Bis(4-nitrophenyl) diselenide	36297-89-9	Contains (regardless of intentional or impurities)	chemical products
11659	4,4'-Bipyridinium, 1,1'-diethyl-, diperchlorate	36305-51-8	Intentional addition / 1,000ppm	chemical products
11660	1,3,2-Dioxaborolane-4-methanol, 2-hydroxy-	36314-25-7	Intentional addition / 1%	chemical products
11661	Manganese, tetrakis(bicyclo[2,2]hept-1-yl)-, (T-4)-	36333-79-6	Contains (regardless of intentional or impurities)	chemical products
11662	O-Ethyl O-(6-nitro-m-tolyl) sec-butylphosphoramidothioate	36335-87-8	Intentional addition / 1%	chemical products
11663	Benzidine acetate	36341-27-2	Contains (regardless of intentional or impurities)	chemical products
11664	Tricarbonyl[(1,2,3,4,5,6-eta.)m-toluidine]chromium	36352-77-9	Intentional addition / 1,000ppm	chemical products
11665	Benzenediazonium, 3-methyl-4-(1-pyrrolidinyl)-, tetrafluoroborate(1-)	36422-95-4	Contains (regardless of intentional or impurities)	chemical products
11666	Distannathiane, dioctyldithio-	36432-42-5	Contains (regardless of intentional or impurities)	chemical products
11667	Benzenepropanoic acid, 3-(1,1-dimethylethyl)-4-hydroxy-5-methyl-, 1,2-ethanediyloxy(2-1-ethanediyloxy) ester	36443-68-2	Intentional addition / 1,000ppm	chemical products
11668	Chromate(1-), diamminetetrakis(thiocyanato-N)-, (OC-6-11)-, hydrogen, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	36447-36-6	Contains (regardless of intentional or impurities)	chemical products
11669	Arsenic acid	36465-76-6	Contains (regardless of intentional or impurities)	chemical products
11670	Chloropropene	36472-34-1	Intentional addition / 1,000ppm	chemical products
11671	Methanesulfonic acid, azetidin-3-yl hydrochloride	36476-89-8	Contains (regardless of intentional or impurities)	chemical products
11672	Uranyl nitrate	36478-76-9	Contains (regardless of intentional or impurities)	chemical products
11673	4,4'-Bipyridinium, 1,1'-diethyl-, bis(tetrafluoroborate(1-))	36490-77-4	Intentional addition / 1%	chemical products
11674	Dicobalt edetate	36499-65-7	Intentional addition / 1,000ppm	chemical products
11675	Boron, chloro[7,12,14,19-diimino-21,5-nitro-5H-tribenzo[c,h,m][1,6,11]triazacyclopentadecinato(2--)-kappa N22,kappa N23,kappa N24]-, (T-4)-	36530-06-0	Intentional addition / 1%	chemical products
11676	(±)-4-Methylhexan-2-one	36536-46-6	Intentional addition / 1,000ppm	chemical products
11677	Nickel, bis(phenyldiazene)carbothioic acid 2-phenylhydrazidato-	36545-21-8	Contains (regardless of intentional or impurities)	chemical products
11678	Strychnidin-10-one, mono[(1.alpha., 2.beta., 3.alpha., 4.alpha., 8.alpha.)beta.](-)-3-(acetyloxy)-1,2,3,4,4a,7,8,8a-octahydro-2-methoxy-7-oxo-1-naphthalene-carboxylate	36547-79-2	Contains (regardless of intentional or impurities)	chemical products
11679	Phosphoric acid, cobalt(2+) salt (2:3), tetrahydrate	36550-56-8	Intentional addition / 1%	chemical products
11680	Pentadecane, 7-bromo-7-methyl-	36559-25-8	Intentional addition / 1,000ppm	chemical products
11681	Chromic acid (H2CrO4), lanthanum(3+) salt (3:2), octahydrate	36563-89-0	Contains (regardless of intentional or impurities)	chemical products
11682	Merbaphen	36568-81-9	Contains (regardless of intentional or impurities)	chemical products
11683	Benzenediazonium, 3-methoxy-4-(1-pyrrolidinyl)-, tetrafluoroborate(1-)	36576-70-2	Intentional addition / 1%	chemical products
11684	Zirconium dicarbonate	36577-48-7	Contains (regardless of intentional or impurities)	chemical products
11685	Quasimide, mono(tetrafluoroborate(1-))	36595-00-3	Intentional addition / 1%	chemical products
11686	Barium nonan-1-olate	36596-55-1	Contains (regardless of intentional or impurities)	chemical products
11687	Isothiostate	36614-38-7	Contains (regardless of intentional or impurities)	chemical products
11688	3-Nonene, 7-bromo-3-methyl-	36618-00-5	Intentional addition / 1,000ppm	chemical products
11689	3-Nonene, 9-bromo-7-ethyl-3-methyl-	36618-03-8	Intentional addition / 1,000ppm	chemical products
11690	Stannane, tributyl	36631-23-9	Contains (regardless of intentional or impurities)	chemical products
11691	Tributyltin-cation	36643-28-4	Contains (regardless of intentional or impurities)	chemical products
11692	Dicarbonyl[1,7,7-trimethyl-3-(trifluoroacetyl)bicyclo[2,2,1]heptan-2-onato-O,O']rhodium	36654-16-7	Contains (regardless of intentional or impurities)	chemical products
11693	Cuprate(2-), [4-[4,5-dihydro-4-[[[2-hydroxy-5-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(4-)]-], dihydrogen	36655-19-3	Intentional addition / 1,000ppm	chemical products
11694	1-Butene, 1-bromo-2-methyl-, (Z)-	36668-55-0	Intentional addition / 1,000ppm	chemical products
11695	Manganese nitride (MnN)	36678-21-4	Intentional addition / 1%	chemical products
11696	Ammonium disodium aminopentakis(cyano-o)ferrate(3-)	36682-41-4	Intentional addition / 1%	chemical products
11697	Benzenamine, 2-methyl-, sulfate	36717-39-2	Intentional addition / 25%	chemical products
11698	Decanols	36729-58-5	Intentional addition / 1%	chemical products
11699	Rhodate(2-), hexachloro-, dihydrogen, (OC-6-11)-	36732-58-8	Contains (regardless of intentional or impurities)	chemical products
11700	Dihydrogen tetrabromoplatinate	36732-80-2	Contains (regardless of intentional or impurities)	chemical products
11701	Iprodione	36734-19-7	Contains (regardless of intentional or impurities)	chemical products
11702	Benzothiazolium, 2-[3-[3-[4-(ethoxycarbonyl)-1-piperazinyl]-5,5-dimethyl-2-cyclohexen-1-ylidene]-1-propenyl]-3-ethyl-, perchlorate	36755-19-8	Intentional addition / 1,000ppm	chemical products
11703	Cuprate(3-), [4-amino-5-hydroxy-6-[[[2-hydroxy-4-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-1,7-naphthalenedisulfonato(5-)]-], trihydrogen	36759-10-1	Intentional addition / 1,000ppm	chemical products
11704	Copper p-toluenesulfonate	36812-50-7	Intentional addition / 1,000ppm	chemical products
11705	Ammonium cobalt orthophosphate	36835-61-7	Intentional addition / 1,000ppm	chemical products
11706	2-Hexene, 6-bromo-	36851-77-1	Intentional addition / 1,000ppm	chemical products
11707	3-Heptene, 7-bromo-	36851-78-2	Intentional addition / 1,000ppm	chemical products
11708	Platinum, tetraamminehydroxy-	36863-22-6	Contains (regardless of intentional or impurities)	chemical products
11709	Barium bis(6,6,7,7,8,8,8-heptafluoro-2,2-dimethyl-3,5-octanedionate)	36885-31-1	Intentional addition	chemical products
11710	Nickel dihydroxide hydrate	36897-37-7	Contains (regardless of intentional or impurities)	chemical products
11711	Octane, 4-bromo-4-methyl-	36903-90-9	Intentional addition / 1,000ppm	chemical products
11712	Octane, 4-bromo-5-methyl-	36903-94-3	Intentional addition / 1,000ppm	chemical products
11713	1-Bromo-2,5-dichloro-4-(methoxy(phenylsulfonyl)phosphoryloxy)benzene	36913-23-2	Intentional addition	chemical products
11714	Benzoic acid, 4-(1-methylethyl)-, cadmium salt	36931-18-7	Contains (regardless of intentional or impurities)	chemical products
11715	Benzenethanaminium, 4-[[[4-[ethyl(2-hydroxy-3-(trimethylammonio)propyl]amino]-2-methylphenyl]azo]-N,NN-trimethyl-beta-oxo-, bis(tetrafluoroborate(1-))	36936-37-5	Intentional addition / 1%	chemical products
11716	4-Undecene, 1-bromo-, (E)-	37011-90-8	Intentional addition / 1,000ppm	chemical products
11717	Gold telluride	37043-71-3	Contains (regardless of intentional or impurities)	chemical products
11718	2-Ethylhexyl 6-butyl-14-ethyl-6-[[[4-[[[2-ethylhexyloxy]-1,4-dioxabut-2-enyl]oxy]-4,8,11-trioxo-5,7,12-trioxo-6-stannaoctadeca-2,9-dienoate	37074-33-2	Contains (regardless of intentional or impurities)	chemical products
11719	3-(N-Butyl-4-nitrosoanilino) propanenitrile	37089-75-1	Contains (regardless of intentional or impurities)	chemical products
11720	2,3-Epoxypropyl propionate	37111-25-4	Contains (regardless of intentional or impurities)	chemical products
11721	Diphosphoric acid, barium cadmium salt	37131-86-5	Contains (regardless of intentional or impurities)	chemical products
11722	Benzenemethanaminium, N,N-dimethyl-N-9-octadecenyl-, chloride, (Z)-	37139-99-4	Intentional addition / 1,000ppm	chemical products
11723	1-Chloro-2,3-difluoropropane	37161-81-2	Intentional addition	chemical products
11724	Hydrodiethylaluminum	37167-85-0	Intentional addition / 1,000ppm	chemical products
11725	Barium strontium niobate	37185-09-4	Contains (regardless of intentional or impurities)	chemical products
11726	Gold cyanide	37187-64-7	Contains (regardless of intentional or impurities)	chemical products
11727	Magnesium manganese ferrite	37187-66-9	Contains (regardless of intentional or impurities)	chemical products
11728	Nickel aluminum alloys	37187-84-1	Contains (regardless of intentional or impurities)	chemical products
11729	Boron carbide (B25C)	37190-23-1	Intentional addition / 1%	chemical products
11730	Boron lithium oxide (B4Li2O7) trihydrate	37195-62-3	Intentional addition / 1%	chemical products
11731	Catocene	37206-42-1	Intentional addition / 1,000ppm	chemical products
11732	Cobalt, mol. (Co2)	37210-16-5	Intentional addition / 1%	chemical products
11733	Potassium molybdate	37211-00-0	Intentional addition / 1%	chemical products
11734	Nickel chloride	37211-05-5	Contains (regardless of intentional or impurities)	chemical products
11735	Ammonium molybdenum oxide ((NH4)2MoO4), dihydrate	37216-99-2	Intentional addition / 1%	chemical products
11736	Manganese fluoride (Mn2F5)	37223-53-3	Contains (regardless of intentional or impurities)	chemical products
11737	Sodium zinc oxide	37224-32-1	Intentional addition	chemical products
11738	Chromium potassium zinc oxide	37224-57-0	Intentional addition / 1,000ppm	chemical products
11739	Arsenic chloride	37226-49-6	Contains (regardless of intentional or impurities)	chemical products
11740	Nickel-beryllium alloy	37227-61-5	Contains (regardless of intentional or impurities)	chemical products
11741	Boric acid, barium salt	37228-06-1	Intentional addition / 1,000ppm	chemical products
11742	Boric acid, strontium salt	37228-07-2	Intentional addition / 1%	chemical products
11743	Hafnium chloride	37230-84-5	Intentional addition / 1%	chemical products
11744	Hafnium oxide	37230-85-6	Intentional addition / 1%	chemical products
11745	Dimethyl dichromium nonoxide	37235-82-8	Contains (regardless of intentional or impurities)	chemical products
11746	Cobalt carbonyl	37264-96-3	Intentional addition / 1,000ppm	chemical products
11747	Barium tungsten yttrium oxide (Ba3WY2O9)	37265-86-4	Contains (regardless of intentional or impurities)	chemical products
11748	C.I. Direct Brown 112	37279-47-3	Intentional addition / 1,000ppm	chemical products
11749	Cuprate(2-), [mu.-[[[7,7'-iminobis[4-hydroxy-3-[[[2-hydroxy-5-[[[methylamino]sulfonyl]phenyl]azo]-2-naphthalenedisulfonato]](6-)]]]di-, disodium	37279-54-2	Intentional addition / 1,000ppm	chemical products
11750	Molybdovanadophosphoric acid	37280-68-5	Intentional addition / 1%	chemical products
11751	Bismuth telluride	37293-14-4	Contains (regardless of intentional or impurities)	chemical products
11752	Lithium molybdate	37296-91-6	Intentional addition / 1%	chemical products
11753	C.I. Pigment Yellow 36	37300-23-5	Contains (regardless of intentional or impurities)	chemical products
11754	Barium titanate zirconate	37305-89-8	Intentional addition	chemical products
11755	Bismuth zirconium oxide (B4Zr3O12)	37306-42-6	Contains (regardless of intentional or impurities)	chemical products
11756	Silver telluride	37318-74-4	Contains (regardless of intentional or impurities)	chemical products
11757	Silicic acid, nickel salt	37321-15-6	Contains (regardless of intentional or impurities)	chemical products
11758	Tungsten carbide (cemented)	37329-49-0	Intentional addition / 1%	chemical products
11759	L-Ascorbic acid, mixture with 3-[[[4-amino-2-methyl-5-pyrimidinyl]methyl]-5-(2-hydroxyethyl)-4-methylthiazolium chloride, 1,2,3-propanetriolmono(dihydrogen phosphate) sodium salt, riboflavin and strychnidin-10-one phosphate (1:1)	37333-45-2	Contains (regardless of intentional or impurities)	chemical products

(Appendix table 1) MISUMI Specified Chemical Substances

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
11760	Copper(I) arsenite	37337-11-4	Contains (regardless of intentional or impurities)	chemical products
11761	Lanthanum dodecaboride	37342-53-3	Intentional addition / 1%	chemical products
11762	Boron carbide (B7C)	37342-73-7	Intentional addition / 1%	chemical products
11763	Bis(3-cyclopentadienyl)chlorohydrozirconium	37342-97-5	Contains (regardless of intentional or impurities)	chemical products
11764	Potassium tungstate	37349-36-3	Intentional addition / 1,000ppm	chemical products
11765	Tin iodide	37349-59-0	Contains (regardless of intentional or impurities)	chemical products
11766	Sillicic acid (H2SiO3), monoanhydride with boric acid (HBO2), sodium salt	37352-55-9	Intentional addition / 1%	chemical products
11767	Copper selenite	37359-15-2	Contains (regardless of intentional or impurities)	chemical products
11768	Indium tin pentachloride	37362-82-6	Contains (regardless of intentional or impurities)	chemical products
11769	Cadmium-copper alloy	37364-96-0	Contains (regardless of intentional or impurities)	chemical products
11770	Aluminum boride	37367-77-4	Intentional addition / 1%	chemical products
11771	Cesium chromate	37367-87-6	Contains (regardless of intentional or impurities)	chemical products
11772	Boric acid cobalt salt	37367-90-1	Intentional addition / 1%	chemical products
11773	Calcium molybdate	37367-98-9	Intentional addition / 1%	chemical products
11774	Molybdenum potassium oxide	37370-04-0	Intentional addition / 1%	chemical products
11775	Direct Black 154	37372-50-2	Intentional addition / 100ppm	chemical products
11776	Aluminum gallium arsenide ((Al,Ga)As)	37382-15-3	Contains (regardless of intentional or impurities)	chemical products
11777	Chromium cobalt oxide	37382-24-4	Contains (regardless of intentional or impurities)	chemical products
11778	5-Amino-2,4,6-triiodo-1,3-benzendicarbonyldichloride	37441-29-5	Contains (regardless of intentional or impurities)	chemical products
11779	Strychnidin-10-one, 3-amino-5-[(dimethylamino)carbonyl]-2,4,6-triiodobenzoate	37441-37-5	Contains (regardless of intentional or impurities)	chemical products
11780	Manganese isocyanate	37449-19-7	Contains (regardless of intentional or impurities)	chemical products
11781	Boronic acid, B-[(1E)-2-cyclohexylethyl]-	37490-33-8	Intentional addition / 1%	chemical products
11782	Sulfonium, (4-hydroxy-2-methylphenyl)dimethyl-, perchlorate	37596-80-8	Intentional addition / 1,000ppm	chemical products
11783	Benzenesulfonic acid, 4-[4,5-dihydro-3-methyl-5-oxo-4-(phenylazo)-1H-pyrazol-1-yl]-, barium salt	37672-83-6	Contains (regardless of intentional or impurities)	chemical products
11784	1-Bromo-3-chloropropene	37675-31-3	Intentional addition / 1,000ppm	chemical products
11785	Tetradecane, 1,14-dibromo-	37688-96-3	Intentional addition / 1,000ppm	chemical products
11786	2,3-Dimethyl-4-nitropyridine 1-oxide	37699-43-7	Contains (regardless of intentional or impurities)	chemical products
11787	Propane, 2,2-selenobis-	37773-02-7	Contains (regardless of intentional or impurities)	chemical products
11788	Benzenamine, phosphate (1:1)	37832-42-1	Contains (regardless of intentional or impurities)	chemical products
11789	Hydrazine, nitrate	37836-27-4	Contains (regardless of intentional or impurities)	chemical products
11790	Ethane, 1,2-bis(2,4,6-tribromophenoxy)-	37853-59-1	Contains (regardless of intentional or impurities)	chemical products
11791	Tetrabromobisphenol A dimethyl ether	37853-61-5	Contains (regardless of intentional or impurities)	chemical products
11792	Heptachlorodibenzo-p-dioxin	37871-00-4	Intentional addition / 1,000ppm	chemical products
11793	Phenyl hydrazine oxalate	37887-33-5	Intentional addition	chemical products
11794	6-(2-Chloroethyl)-6-(2-methoxyethoxy)-2,5,7,10-tetraoxa-6-silauundecane	37894-46-5	Contains (regardless of intentional or impurities)	chemical products
11795	Copper magnesium ethylenediaminetetraacetate	37979-85-4	Intentional addition / 1,000ppm	chemical products
11796	N,N-Bis(salicylidene)dianilino-cobalt(II)	37981-00-3	Intentional addition / 1%	chemical products
11797	Manganese magnesium ethylenediaminetetraacetate	37991-53-0	Contains (regardless of intentional or impurities)	chemical products
11798	Zirconium ammonium lactate	37999-72-7	Contains (regardless of intentional or impurities)	chemical products
11799	Strychnidin-10-one, stereoisomer of 2',2''-[methylidynetris(thio)tris[propanoate]] (2:1)	38004-58-9	Contains (regardless of intentional or impurities)	chemical products
11800	9-Methoxy-9-borabicyclo[3.3.1]nonane	38050-71-4	Intentional addition / 1%	chemical products
11801	2,2-Bis(chloromethyl)-1,3-propanediyli tetrakis(2-chloroethyl) phosphate	38051-10-4	Intentional addition / 900ppm	chemical products
11802	1,3-Bis(dicyanomethylidene)indane	38172-19-9	Intentional addition	chemical products
11803	1,6-Dichlorodibenzo-p-dioxin	38178-38-0	Intentional addition / 1,000ppm	chemical products
11804	Platinum(2+), tetraaminedihydroxy-	38201-97-7	Contains (regardless of intentional or impurities)	chemical products
11805	1-(4-Methoxyphenyl)piperazine	38212-30-5	Intentional addition	chemical products
11806	Citric acid, copper sodium salt	38218-87-0	Intentional addition / 1,000ppm	chemical products
11807	Diboron cobalt(2+) tetraoxide	38233-75-9	Intentional addition / 1,000ppm	chemical products
11808	1-Methoxybicyclo[2.2.2]oct-5-ene-2-carbonitrile	38258-92-3	Intentional addition	chemical products
11809	Ethanol, 2-hydrazino-, mononitrate	38271-52-2	Intentional addition	chemical products
11810	Thiosulfuric acid (H2S2O3), gold sodium salt (1:1:1)	38295-16-8	Intentional addition	chemical products
11811	Diboron europium tetraoxide	38313-81-4	Intentional addition / 1%	chemical products
11812	1-Heptene, 6-bromo-	38334-89-4	Intentional addition / 1,000ppm	chemical products
11813	Sulfuric acid, monododecyl ester, manganese(2+) salt	38344-88-6	Contains (regardless of intentional or impurities)	chemical products
11814	Pentane, 3-chloro-2-methyl-	38384-05-3	Intentional addition / 1,000ppm	chemical products
11815	Sulfuric acid, cadmium potassium salt (2:1:2), dihydrate	38386-25-3	Intentional addition / 1,000ppm	chemical products
11816	Disodium hexadecylsulfonate	38416-13-6	Contains (regardless of intentional or impurities)	chemical products
11817	2'-Naphthalenedisulfonic acid, 4-amino-3-[[4'-[[2,4-diaminophenyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-5-hydroxy-6-(phenylazo)-, disodium salt	38449-92-2	Intentional addition	chemical products
11818	Tin(III) chromate	38455-77-5	Contains (regardless of intentional or impurities)	chemical products
11819	Nickel, bis[1-[4-(dimethylamino)phenyl]-2-phenyl-1,2-ethenedithiolato(2-)-]S,S'	38465-55-3	Contains (regardless of intentional or impurities)	chemical products
11820	Borate(1-), tetrafluoro-, copper(2+) (2:1)	38465-80-0	Contains (regardless of intentional or impurities)	chemical products
11821	2-(Tricycloxy)ethanol	38471-49-7	Intentional addition / 1%	chemical products
11822	Benzonitrile, 2-amino-4-chloro-	38487-86-4	Intentional addition	chemical products
11823	1,3-Isobenzofurandione, 3a,4,7,7a-tetrahydro-4(or 5)-methyl-	38497-16-4	Intentional addition / 1%	chemical products
11824	Cadmium(2+) (R)-12-hydroxooctadecanoate	38517-19-0	Contains (regardless of intentional or impurities)	chemical products
11825	2,3,4,5,6.alpha.-hexabromotoluene	38521-51-6	Intentional addition / 900ppm	chemical products
11826	Cyclohexanebutanoic acid, cobalt(2+) salt	38582-17-1	Intentional addition / 1,000ppm	chemical products
11827	Mixture of (dichlorophosphino)biphenyl (mixture) and 2(or 3 or 4)2'(or 3' or 4')-bis(dichloro phosphino)biphenyl (mixture)	38613-89-7	Contains (regardless of intentional or impurities)	chemical products
11828	Distannoxane, 1,1,3,3-tetrabutyl-1,3-bis[(2-ethyl-1-oxohexyloxy)-], dimer	38620-15-4	Contains (regardless of intentional or impurities)	chemical products
11829	Manganese, diquadrachloro-, homopolymer	38639-72-4	Contains (regardless of intentional or impurities)	chemical products
11830	Diisopropylmethylol ether	38640-62-9	Intentional addition / 1%	chemical products
11831	Quinolinium, 1-ethyl-6-methyl-2-[[3-(4-sulfobutyl)-2(3H)-benzosenelenazoly]idene]methyl-, hydroxide, inner salt	38650-20-3	Contains (regardless of intentional or impurities)	chemical products
11832	Tris(D-gluconato-O1,O2)iron	38658-53-6	Intentional addition / 1%	chemical products
11833	Benzenidone perchlorate	38668-12-1	Contains (regardless of intentional or impurities)	chemical products
11834	Benzoic acid, 4-heptyl-, 4-cyanophenyl ester	38690-76-5	Intentional addition	chemical products
11835	Dimethylbutane	38719-68-5	Intentional addition / 1,000ppm	chemical products
11836	Borate(1-), hydrotris(1-methylpropyl)-, lithium, (T-4)-	38721-52-7	Intentional addition / 1%	chemical products
11837	2,8,14,18,24,30-Hexaoxa-6,10,22,26-tetraethia-7,9,23,25-tetrastanna-7,9,9-23,25-25,25-octadodecylspiro[15]15hentiacton-3,13,19,29-tetraene	38732-53-5	Intentional addition / 1,000ppm	chemical products
11838	p-Toluenesulfonate 7-oxocyclopropa-1,3,5-toluene-1-yl	38768-08-0	Intentional addition / 1%	chemical products
11839	Dichlorobis(cyclopentylamine)platinum	38780-36-8	Contains (regardless of intentional or impurities)	chemical products
11840	Platinum, diammine[propanedioato(2-)-O,O']-, (SP-4-2)-	38780-43-7	Contains (regardless of intentional or impurities)	chemical products
11841	Nickel(2+), tris(4,7-diphenyl-1,10-phenanthroline-N1,N10)-, (OC-6-11)-, dinitrate	38780-90-4	Contains (regardless of intentional or impurities)	chemical products
11842	4-Phenoxy-1,2-benzene dicarbonitrile	38791-62-7	Intentional addition	chemical products
11843	Pentane, dimethyl-	38815-29-1	Intentional addition / 1%	chemical products
11844	Cuprate(5-), [3-[[[6-[[4-chloro-6-[[3-sulfophenylamino]-1,3,5-triazin-2-ylamino]-2-sulfophenyl]azo]-2,5-dihydroxy-7-sulfo-1-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonyl(7-)]-, pentahydrogen	38828-82-9	Intentional addition / 1,000ppm	chemical products
11845	Chromate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]-, hydrogen	38833-00-0	Contains (regardless of intentional or impurities)	chemical products
11846	1-(4-Methoxyphenyl)piperazine-1,4-diylium dichloride	38869-47-5	Intentional addition	chemical products
11847	Copper, [C,C,C,C-tetrakis(chloromethyl)-29H,31H-phthalocyaninato(2-)-]kappa.N29.kappa.N30.kappa.N31.kappa.N32-	38884-10-5	Intentional addition / 1,000ppm	chemical products
11848	Copper, [C-(chloromethyl)-29H,31H-phthalocyaninato(2-)-]kappa.N29.kappa.N30.kappa.N31.kappa.N32-	38886-67-8	Intentional addition / 1,000ppm	chemical products
11849	Antimony, (benzoyl chloride)pentachloro-, (OC-6-21)-	38907-80-8	Contains (regardless of intentional or impurities)	chemical products
11850	Nickel, bis[2-butene-2,3-dithiolato(2-)-S,S']-, (SP-4-1)-	38951-94-9	Contains (regardless of intentional or impurities)	chemical products
11851	Nickel, bis[1,2-bis(4-methoxyphenyl)-1,2-ethenedithiolato(2-)-S,S']-, (SP-4-1)-	38951-97-2	Contains (regardless of intentional or impurities)	chemical products
11852	Propanoic acid, 3-(dodecylthio)-, barium salt	38952-49-7	Contains (regardless of intentional or impurities)	chemical products
11853	Propanoic acid, 3-(octadecylthio)-, barium salt	38952-51-1	Contains (regardless of intentional or impurities)	chemical products
11854	Dichlorobis(pentane-2,4-dionato-O,O')vanadium	38991-25-2	Intentional addition / 1%	chemical products
11855	Copper, bis[1,3-dihydro-2H-benzimidazole-2-thionato-N1,S2]-	38994-57-9	Intentional addition / 1,000ppm	chemical products
11856	Hydroxytris(2-hydroxypropanoato-O1,O2)zirconium	38999-98-3	Contains (regardless of intentional or impurities)	chemical products
11857	Octachlorodibenzofuran	39001-02-0	Contains (regardless of intentional or impurities)	chemical products
11858	Bis[2-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulphamoylbenzoato(2-)]chromate(1-)	39002-49-8	Contains (regardless of intentional or impurities)	chemical products
11859	Neodecanoic acid, zirconium salt	39049-04-2	Contains (regardless of intentional or impurities)	chemical products
11860	Dipotassium tris(cyano-c)nickelate(2-)	39049-81-5	Contains (regardless of intentional or impurities)	chemical products
11861	Dibenzo(b,e)(1,4)dioxin, 2,7-dibromo-	39073-07-9	Intentional addition / 100ppm	chemical products
11862	Hafnium telluride (HTe2)	39082-23-0	Contains (regardless of intentional or impurities)	chemical products
11863	Strychnidin-10-one, monobenzoate	39089-11-7	Contains (regardless of intentional or impurities)	chemical products
11864	Strychnine mono (o-chlorobenzoate)	39089-12-8	Contains (regardless of intentional or impurities)	chemical products
11865	Strychnine mono (m-chlorobenzoate)	39089-13-9	Contains (regardless of intentional or impurities)	chemical products
11866	Strychnine mono (p-chlorobenzoate)	39089-14-0	Contains (regardless of intentional or impurities)	chemical products
11867	Strychnine mono (o-bromobenzoate)	39089-15-1	Contains (regardless of intentional or impurities)	chemical products
11868	Strychnine m-bromobenzoate	39089-16-2	Contains (regardless of intentional or impurities)	chemical products
11869	Strychnine mono (p-bromobenzoate)	39089-17-3	Contains (regardless of intentional or impurities)	chemical products
11870	Vanadium dihydroxide	39096-97-4	Intentional addition / 1%	chemical products
11871	(3,5-Dimethylphenyl)acetoneitrile	39101-54-7	Contains (regardless of intentional or impurities)	chemical products
11872	Tris(hexane-2,4-dionato-O,O')iron	39114-45-9	Intentional addition / 1%	chemical products
11873	Oxobis(pentane-2,4-dionato-O,O')uranium	39136-40-8	Contains (regardless of intentional or impurities)	chemical products
11874	Benzene-o-diamine monohydrochloride	39145-59-0	Intentional addition / 25%	chemical products
11875	1,3-Benzenediamine, 4-methoxy-, sulfate (1:1)	39156-41-7	Contains (regardless of intentional or impurities)	chemical products
11876	Decane, 2,4-trichloro-	39185-78-9	Intentional addition / 1,000ppm	chemical products
11877	1,1,3,3-Tetrachlorobutane	39185-82-5	Intentional addition / 1,000ppm	chemical products
11878	Tetrachloronitroethane	39185-89-2	Intentional addition	chemical products
11879	4-Bromo-2,2-diphenylbutanenitrile	39186-58-8	Intentional addition	chemical products
11880	Disodium [[N,N'-ethylenbis[N-(carboxymethyl)glycino]](4-)-]N,N',O,O']cuprate(2-)	39208-15-6	Intentional addition / 1,000ppm	chemical products
11881	1,2,3,4,7,8-Hexachlorodibenzo-p-dioxin	39227-28-6	Intentional addition / 1,000ppm	chemical products
11882	1-Chlorodibenzo(b,e)[1,4]dioxin	39227-53-7	Intentional addition / 1,000ppm	chemical products
11883	2-Chlorodibenzo(b,e)[1,4]dioxin	39227-54-8	Intentional addition / 1,000ppm	chemical products
11884	1,2,4-Trichlorodibenzo-1,4-dioxin	39227-58-2	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
11885	1,2,3,4,7-Pentachlorodibenzo-p-dioxin	39227-81-7	Intentional addition / 1,000ppm	chemical products
11886	1,2,4,6,7,9-Hexachlorodibenzo-p-dioxin	39227-82-8	Intentional addition / 1,000ppm	chemical products
11887	4-Chloromethyl-2-methylthiazole hydrochloride	39238-07-8	Intentional addition / 1%	chemical products
11888	1-Tetradecanol, 3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,12,13,13,14,14,14-pentacosafuoro-	39239-77-5	Contains (regardless of intentional or impurities)	chemical products
11889	Thallium(1+) propan-2-olate	39262-04-9	Contains (regardless of intentional or impurities)	chemical products
11890	1-Benzopyrylium, 4-ethoxy-2-(4-methoxyphenyl)-, perchlorate	39273-52-4	Intentional addition / 1,000ppm	chemical products
11891	Filtrate from the manufacture of 1-Methyl-7-nitro-1,2,3,4-tetrahydroquinoline	39275-16-6	Contains (regardless of intentional or impurities)	chemical products
11892	1-Methyl-7-nitro-1,2,3,4-tetrahydroquinoline	39275-18-8	Contains (regardless of intentional or impurities)	chemical products
11893	Fumaratochromium(III) nitrate	39275-63-3	Contains (regardless of intentional or impurities)	chemical products
11894	Disodium hexaboromalonate	39277-13-9	Contains (regardless of intentional or impurities)	chemical products
11895	Limosulfonic acid, barium salt	39278-27-8	Intentional addition / 1,000ppm	chemical products
11896	Boric acid, copper salt	39290-85-2	Intentional addition / 1,000ppm	chemical products
11897	Tungsten zirconium oxide	39290-95-4	Contains (regardless of intentional or impurities)	chemical products
11898	Antimony compound with strontium (2:3)	39294-08-1	Contains (regardless of intentional or impurities)	chemical products
11899	1-Ethenyl-3-methylbenzene	39294-88-7	Intentional addition / 1,000ppm	chemical products
11900	Magnesium heptaoxidialuminatedichromate(2-)	39297-19-3	Contains (regardless of intentional or impurities)	chemical products
11901	Strontium arsenide (Sr3As2)	39297-24-0	Contains (regardless of intentional or impurities)	chemical products
11902	Dinocap	39300-45-3	Contains (regardless of intentional or impurities)	chemical products
11903	Zirconate(4-), [orthosilicate(4-)-O]dioxo-, tetralithium	39302-29-9	Contains (regardless of intentional or impurities)	chemical products
11904	Iron arsenide	39310-41-3	Contains (regardless of intentional or impurities)	chemical products
11905	Magnesium zirconate	39318-32-6	Contains (regardless of intentional or impurities)	chemical products
11906	Potassium chromate	39322-04-8	Contains (regardless of intentional or impurities)	chemical products
11907	Dibarium oxobis[phosphato(3-)-O]titanate(2-)	39326-66-4	Contains (regardless of intentional or impurities)	chemical products
11908	Chromium chloride	39345-92-1	Intentional addition / 1,000ppm	chemical products
11909	Antimony compound with iron (2:3)	39356-80-4	Contains (regardless of intentional or impurities)	chemical products
11910	Cobalt zirconium oxide	39361-75-6	Contains (regardless of intentional or impurities)	chemical products
11911	Calcium boride	39377-46-3	Intentional addition / 1%	chemical products
11912	Copper cyanide	39377-49-6	Contains (regardless of intentional or impurities)	chemical products
11913	Nickel carbonate hydroxide (Ni3(CO3)(OH)4, hydrate (1:4)	39380-74-0	Contains (regardless of intentional or impurities)	chemical products
11914	Borate(2-), dodecafluoro-mu.4-oxotetra-, diammonium	39383-00-1	Intentional addition / 1,000ppm	chemical products
11915	Iron boride	39383-96-5	Intentional addition / 1%	chemical products
11916	Arsenic selenide (As5Se4)	39399-60-5	Contains (regardless of intentional or impurities)	chemical products
11917	Sodium uranium chromate oxide (Na2U2(CrO4)3O4) hexahydrate	39400-35-6	Intentional addition / 1,000ppm	chemical products
11918	Zinc beryllium silicate	39413-47-3	Contains (regardless of intentional or impurities)	chemical products
11919	Vanadate (VO4-), barium (1:2), (T-4)-	39416-30-3	Contains (regardless of intentional or impurities)	chemical products
11920	Antimony telluride	39427-02-6	Contains (regardless of intentional or impurities)	chemical products
11921	Nickel, carbonate(2-)(tetrahydroxytri-, tetrahydrate	39430-27-8	Contains (regardless of intentional or impurities)	chemical products
11922	Acetic acid, chromium salt, basic	39430-51-8	Intentional addition / 1,000ppm	chemical products
11923	Poly(oxy-1,2-ethanediy), alpha-hydro-omega-hydroxy-, ester with boric acid (H3BO3)	39434-94-1	Intentional addition / 1%	chemical products
11924	Monochlorobutene	39437-98-4	Intentional addition / 1,000ppm	chemical products
11925	Manganese chloride hydroxide	39438-40-9	Contains (regardless of intentional or impurities)	chemical products
11926	Copper, compound with tin (4:1)	39445-33-5	Contains (regardless of intentional or impurities)	chemical products
11927	Copper, compound with samarium (17:2)	39445-37-9	Intentional addition / 1,000ppm	chemical products
11928	Chromium tungsten oxide	39455-56-6	Intentional addition / 1,000ppm	chemical products
11929	Ammonium sodium vanadium oxide	39455-80-6	Intentional addition / 1%	chemical products
11930	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, alginate	39461-16-0	Contains (regardless of intentional or impurities)	chemical products
11931	Nicotinic pectate	39461-17-1	Contains (regardless of intentional or impurities)	chemical products
11932	Magnesium stannate	39467-03-3	Intentional addition / 1,000ppm	chemical products
11933	Cyphenothrin	39515-40-7	Intentional addition	chemical products
11934	Fenprothrin	39515-41-8	Contains (regardless of intentional or impurities)	chemical products
11935	Dichlorobis(ethylenediamine)rhodium nitrate	39561-32-5	Contains (regardless of intentional or impurities)	chemical products
11936	2-Bromoundecane	39563-54-7	Intentional addition / 1,000ppm	chemical products
11937	Pentane, 1,1,1,3-tetrachloro-3-(1,1-dimethylethyl)-4,4-dimethyl-	39580-89-7	Intentional addition / 1,000ppm	chemical products
11938	Bisthioseni	39603-48-0	Intentional addition / 2%	chemical products
11939	Chromate(1-), bis[2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoate(2-)-], hydrogen, compound with 3-[[2-ethylhexyloxy]-1-propanamine (1:1)	39609-25-1	Contains (regardless of intentional or impurities)	chemical products
11940	Phenol, 4,4'-sulfonylbis[2,6-dibromo-	39635-79-5	Intentional addition / 100ppm	chemical products
11941	Stannane, tributyl[2,4-dichlorophenoxy]-	39637-16-6	Contains (regardless of intentional or impurities)	chemical products
11942	2-(Acetoxymercuri)tetramethyl-2-imidazolyl-1-yloxy-3-oxide	39657-41-5	Intentional addition / 1%	chemical products
11943	Acrylic acid, tin salt	39670-15-0	Contains (regardless of intentional or impurities)	chemical products
11944	Strychnidin-10-one, compound with beta-D-palactofuranose 1-(dihydrogenphosphate) (2:1)	39698-25-4	Contains (regardless of intentional or impurities)	chemical products
11945	Copper, [N,N',N'']-tetractadecyl-29H,31H-phthalocyanine-C,C,C,C-tetrasulfonamidato(2-)-N29,N30,N31,N32]-	39702-40-4	Intentional addition / 1,000ppm	chemical products
11946	Selenious acid, strontium salt (2:1)	39712-38-4	Contains (regardless of intentional or impurities)	chemical products
11947	Tin abietate	39717-39-0	Contains (regardless of intentional or impurities)	chemical products
11948	Nonachlor, trans-	39765-80-5	Intentional addition / 6%	chemical products
11949	Nickel bis(benzenesulphonate)	39819-85-3	Contains (regardless of intentional or impurities)	chemical products
11950	2,4-Dimethoxyphenylmercuric chloride	39833-87-9	Contains (regardless of intentional or impurities)	chemical products
11951	1-Heptene, 1-bromo-, (Z)-	39924-57-7	Intentional addition / 1,000ppm	chemical products
11952	Tellurium, tetrachloro(1-phenylethane)-	39933-52-3	Contains (regardless of intentional or impurities)	chemical products
11953	Hydrazinium sulphamate	39935-03-0	Contains (regardless of intentional or impurities)	chemical products
11954	2-[[2-[(3-Ethyl-5-methyl-3H-benzoselenazol-2-ylidene)methyl]but-1-enyl]-5,6-dimethyl-3-(3-sulphonatopropyl)benzoselenazolium	39981-05-0	Contains (regardless of intentional or impurities)	chemical products
11955	Tetrabutylammonium mu.-hydrohexahydroborate	40001-25-0	Intentional addition / 1%	chemical products
11956	Phenol, 4,4'-(1-methylethylenedibis[2,6-dibromo- polymer with (chloromethyl)oxirane	40039-93-8	Intentional addition / 900ppm	chemical products
11957	1,1'-Biphenyl, tetrabromo-	40088-45-7	Intentional addition / 1,000ppm	chemical products
11958	6-Selenoinosine	40093-99-0	Contains (regardless of intentional or impurities)	chemical products
11959	Diboron manganese tetraoxide	40105-04-2	Contains (regardless of intentional or impurities)	chemical products
11960	(3,4-Dimethoxyphenyl)hydrazine monohydrochloride	40119-17-3	Contains (regardless of intentional or impurities)	chemical products
11961	3-Amino-6-chloromethyl-2-(pyrazin-4-oxide)carbonitrile	40127-89-7	Intentional addition	chemical products
11962	3,4-Xylylmercuric chloride	40138-90-7	Contains (regardless of intentional or impurities)	chemical products
11963	1-(Chloromethyl)-4-isopropoxybenzene	40141-12-6	Intentional addition / 1%	chemical products
11964	1-Propylboronic acid catechol ester	40218-49-3	Intentional addition / 1%	chemical products
11965	Barium(2+) dihydroxide hydrate	40226-30-0	Intentional addition	chemical products
11966	5,6-Dimethyl-2,3-pyrazine dicarbonitrile	40227-17-6	Intentional addition	chemical products
11967	2-Propanone, 1-(acetyloxy)-3-chloro-	40235-88-5	Contains (regardless of intentional or impurities)	chemical products
11968	2,2'-Spiro[6-hydroxy-4,4,7-trimethylchromane)	40278-59-9	Intentional addition / 1,000ppm	chemical products
11969	1,2,3,7,8-Pentachlorodibenzo-p-dioxin	40321-76-4	Intentional addition / 1,000ppm	chemical products
11970	Bis(2-chlorovinyl)chloroarsine	40334-69-8	Contains (regardless of intentional or impurities)	chemical products
11971	Arsine, tris(2-chloroethyl)-	40334-70-1	Contains (regardless of intentional or impurities)	chemical products
11972	Sulfuric acid, ammonium indium(3+) salt (2:1), dodecahydrate	40399-07-3	Intentional addition / 1,000ppm	chemical products
11973	Adenosine 5-(trihydrogen diphosphate), barium salt (1:3)	40436-88-2	Intentional addition	chemical products
11974	Strychnidin-10-one, (+)-9,10-dihydro-ethenoanthracene-1,5-dicarboxylate (1:1)	40443-27-4	Contains (regardless of intentional or impurities)	chemical products
11975	2,7-Diisopropynaphthalene	40458-98-8	Intentional addition / 1%	chemical products
11976	Heptafluorotetrahydro(nonafluorobutyl)furan	40464-54-8	Intentional addition / 1%	chemical products
11977	Pendimethalin	40487-42-1	Contains (regardless of intentional or impurities)	chemical products
11978	Chloromethylmethyl carbonate	40510-81-4	Contains (regardless of intentional or impurities)	chemical products
11979	4-Chloromethyl-2-isopropylthiazole	40516-57-2	Intentional addition / 1%	chemical products
11980	1,2,6,7-Tetrachlorodibenzo-p-dioxin	40581-90-6	Intentional addition / 1,000ppm	chemical products
11981	1,2,6,9-Tetrachlorodibenzo(b,e)(1,4)dioxin	40581-91-7	Intentional addition / 1,000ppm	chemical products
11982	1,4,6,9-Tetrachlorodibenzo(b,e)(1,4)dioxin	40581-93-9	Intentional addition / 1,000ppm	chemical products
11983	1,4,7,8-Tetrachlorodibenzo(b,e)(1,4)dioxin	40581-94-0	Intentional addition / 1,000ppm	chemical products
11984	4-Hydroxybutyl (2,4,5-trichlorophenoxy)acetate	40583-17-3	Intentional addition / 1,000ppm	chemical products
11985	Pentan-2-ol, triester with boric acid	40589-08-0	Intentional addition / 1%	chemical products
11986	Sulphamic acid, tin salt	40609-56-1	Contains (regardless of intentional or impurities)	chemical products
11987	Cobalt, bis(dicyclohexylphosphinodithiostato-S,S')-	40621-10-1	Intentional addition / 1,000ppm	chemical products
11988	Propanoyl chloride, 2-(acetyloxy)-2-methyl-	40635-66-3	Contains (regardless of intentional or impurities)	chemical products
11989	Propanoyl bromide, 2-(acetyloxy)-2-methyl-	40635-67-4	Contains (regardless of intentional or impurities)	chemical products
11990	Chromate(1-), bis(pyridine)tetrakis(thiocyanato-N)-, hydrogen, compound with strychnidin-10-one (1:1)	40701-06-2	Contains (regardless of intentional or impurities)	chemical products
11991	3-Chloro-4-[3-(trifluoromethyl)phenoxy]aniline	40718-17-7	Intentional addition / 1%	chemical products
11992	(2-chloroethyl)(3-hydroxypropyl)ammonium chloride	40722-80-3	Contains (regardless of intentional or impurities)	chemical products
11993	(OC-6-1)-Hexaamminechromium tribromide	40752-90-7	Intentional addition / 1,000ppm	chemical products
11994	Carbonic acid, ammonium zinc salt (2:2:1)	40861-29-8	Intentional addition / 25%	chemical products
11995	1-Octene, 3-bromo-	40906-92-1	Intentional addition / 1,000ppm	chemical products
11996	2-Chloro-2-(2-fluorobenzoyl)-N-methyl-4-nitroacetanilide	40913-84-6	Contains (regardless of intentional or impurities)	chemical products
11997	1H-Imidazole-4,5-dicarbonitrile, 2-amino-	40953-34-2	Intentional addition	chemical products
11998	2,3-Dimethoxyphenylboronic acid	40972-86-9	Intentional addition / 1%	chemical products
11999	[R-(R*,R*)]-Tartaric acid, iron(2+) salt	41014-96-4	Intentional addition / 1%	chemical products
12000	1,3,6-Naphthalenetrilsulfonic acid, 7-amino-, sodium salt	41016-61-9	Contains (regardless of intentional or impurities)	chemical products
12001	1-(Tricyclohexylstannyloxy)-1H-1,2,4-triazole	41083-11-8	Contains (regardless of intentional or impurities)	chemical products
12002	Triethylammonium hexachlorostannate(2-)	41086-64-0	Contains (regardless of intentional or impurities)	chemical products
12003	[1,1'-Biphenyl]-4-carbonitrile, 4'-hexyl-	41122-70-7	Intentional addition	chemical products
12004	Bis(p-toluic acid)cobalt(II) salt	41122-85-4	Intentional addition / 1%	chemical products
12005	1,1'-[Methylenbis(sulfonyl)] bis-2-chloroethane	41123-59-5	Intentional addition / 1%	chemical products
12006	[29H,31H-Phthalocyanine-2,9,10,16,17,23,24-octacarboximidato(2-)-N29,N30,N31,N32]copper	41127-68-8	Intentional addition / 1,000ppm	chemical products
12007	Barium bis(p-nonylphenolate)	41157-58-8	Contains (regardless of intentional or impurities)	chemical products
12008	Barium bis(p-octylphenolate)	41157-62-4	Contains (regardless of intentional or impurities)	chemical products
12009	1,1'-Bis(2,4-dinitrophenyl)-4,4'-bipyridine-1,1'-dium dichloride	41168-79-0	Contains (regardless of intentional or impurities)	chemical products
12010	Chromic acid, potassium zinc salt	41189-36-0	Contains (regardless of intentional or impurities)	chemical products
12011	Benzidine dipchlorate	41195-21-5	Contains (regardless of intentional or impurities)	chemical products
12012	Profenofos	41198-08-7	Contains (regardless of intentional or impurities)	chemical products
12013	Strychnidin-10-one, monothiocyanate	41239-66-1	Contains (regardless of intentional or impurities)	chemical products
12014	Chromic acid (H2CrO4), chromium(2+) salt	41261-95-4	Intentional addition / 1,000ppm	chemical products
12015	Arsine selenide, trimethyl-	41262-21-9	Contains (regardless of intentional or impurities)	chemical products

(Appendix table 1) MISUMI Specified Chemical Substances

Ver.2.0.0 date of revision 5/31/2022 Misumi Corporation

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
12016	[1,8,15,22-Tetramethyl-29H,31H-tetrapyrrodo[2,3-b:2',3'-g:2',3'-l:2',3'-o]porphyrinazinomat(2-)-N29,N30,N31,N32]copper(4+) tetramethyl tetrakis(sulphate)	41276-95-3	Intentional addition / 1,000ppm	chemical products
12017	Dipotassium selenite tetrahydrate	41292-06-2	Intentional addition / 1,000ppm	chemical products
12018	Copper(1+) acrylate	41380-06-7	Intentional addition / 1,000ppm	chemical products
12019	4-Amino-3-methyl-6-phenyl-1,2,4-triazin-5-one	41394-05-2	Contains (regardless of intentional or impurities)	chemical products
12020	Phenol, cyclohexyl-, barium salt	41407-36-7	Intentional addition / 1,000ppm	chemical products
12021	[1,1'-Biphenyl]-4-carbonitrile, 4-(hexyloxy)-	41424-11-7	Intentional addition	chemical products
12022	Nickel bis(piperidine-1-carbodiathioate)	41476-75-9	Contains (regardless of intentional or impurities)	chemical products
12023	Antimonate(1-), hexafluoro-, (OC-6-11)-, salt with N,N-bis[4-(diethylamino)phenyl]-N,N'-diethyl-1,4-benzendiamine (1.1)	41494-34-2	Contains (regardless of intentional or impurities)	chemical products
12024	Antimonate(1-), hexafluoro-, (OC-6-11)-, salt with N,N-dibutyl-N,N'-bis[4-(dibutylamino)phenyl]-1,4-benzendiamine (1.1)	41494-35-3	Contains (regardless of intentional or impurities)	chemical products
12025	Strychnidin-10-one, compound with 4,4'-(3H-2,1-benzoxathiol-3-ylidene)bis[2-bromo-3-methyl-6-(1-methylethyl)phenol] S,S-dioxide	41528-82-9	Contains (regardless of intentional or impurities)	chemical products
12026	Platinum diamminebis(nitrate-O-), (SP-4-2)-	41575-87-5	Contains (regardless of intentional or impurities)	chemical products
12027	Carbolatin	41575-94-4	Contains (regardless of intentional or impurities)	chemical products
12028	1-Tetradecanaminium, N,N-dimethyl-N-[3-(trimethoxysilyl)propyl]-, chloride	41591-87-1	Intentional addition / 1,000ppm	chemical products
12029	Trihydrophosphorus trifluoride/boron	41593-56-0	Intentional addition / 1%	chemical products
12030	2-Naphthalenesulfonamide, 6-amino-5-[(2-hydroxy-4-nitrophenyl)azo]-N-methyl-	41605-93-0	Intentional addition / 1%	chemical products
12031	Methyl 4-amino-3-methoxybenzoate	41608-84-4	Contains (regardless of intentional or impurities)	chemical products
12032	1-(4,6-Diethoxy-1,3,5-triazin-2-yl)-1-methylpiperidinium tetrafluoroborate	41654-51-7	Intentional addition / 1%	chemical products
12033	Disiloxanol, 3,3'-(1,7-dicarbododecaborane(12)-1,7-diy)bis[1,1,3,3-tetramethyl-, polymer with dichloromethylphenylsilane	41655-17-8	Intentional addition / 1%	chemical products
12034	Nitric acid, cobalt sodium salt	41663-81-4	Intentional addition / 1%	chemical products
12035	(Ethane-1,2-diamine-N,N')(malonato(2-)-O,O')platinum	41666-77-7	Contains (regardless of intentional or impurities)	chemical products
12036	Nickelate(2-), tetrakis(cyano-kappa-C)-, zinc (1:1), (SP-4-1)-	41685-66-9	Contains (regardless of intentional or impurities)	chemical products
12037	Boronic acid, [3-[(2-methyl-1-oxo-2-propenyl)amino]phenyl]-, homopolymer	41685-84-1	Intentional addition / 1%	chemical products
12038	Chromate(1-), bis[2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]-, sodium salt	41741-86-0	Contains (regardless of intentional or impurities)	chemical products
12039	Benzenediazonium, 2,5-diethoxy-4-[(4-methylphenyl)thio]-, tetrafluoroborate(1-)	41749-18-2	Contains (regardless of intentional or impurities)	chemical products
12040	Benzidine dihydrofluoride	41766-73-8	Contains (regardless of intentional or impurities)	chemical products
12041	o-Tolidine dihydrofluoride	41766-75-0	Contains (regardless of intentional or impurities)	chemical products
12042	1,2,4-Triazole(3,4-b)benzothiazole, 5-methyl-	41814-78-2	Contains (regardless of intentional or impurities)	chemical products
12043	Benzo[a]phenoxazin-7-ium, 5,9-diamino- perchlorate	41830-80-2	Intentional addition / 1,000ppm	chemical products
12044	Phenoxazin-5-ium, 3,7-bis(ethylamino)-2,8-dimethyl-, perchlorate	41830-81-3	Intentional addition / 1,000ppm	chemical products
12045	HCF3 122 (mixture)	41834-16-6	Intentional addition / 1,000ppm	chemical products
12046	Boric acid (HBO2), lithium salt (1:1), octahydrate	41851-38-1	Intentional addition / 1%	chemical products
12047	Benzenemethanaminium, N,NN-trimethyl-, (OC-6-11)-hexachloroplatinate(2-)(2:1)	41909-89-1	Contains (regardless of intentional or impurities)	chemical products
12048	Vanadium, hydroxyoxobis(8-quinolinolato-N1,O8)-, (OC-6-14)-	41922-39-8	Intentional addition / 1%	chemical products
12049	Nicotine pentachlorophenolate	41944-89-2	Contains (regardless of intentional or impurities)	chemical products
12050	2-Chloro-4-iodoaniline	42016-93-3	Contains (regardless of intentional or impurities)	chemical products
12051	Zirconium(4+) oleate	42040-79-9	Contains (regardless of intentional or impurities)	chemical products
12052	9,12-Octadecadienoic acid (9Z,12Z)-, zirconium(4+) salt	42040-80-2	Contains (regardless of intentional or impurities)	chemical products
12053	Strychnidin-10-one, mono(+)-(3-dibenzofuranysulfonyl)acetate	42138-26-1	Contains (regardless of intentional or impurities)	chemical products
12054	Strychnidin-10-one, mono(+)-(3-dibenzofuranysulfonyl)acetate	42138-27-2	Contains (regardless of intentional or impurities)	chemical products
12055	Strychnidin-10-one, mono(+)-(4-dibenzofuranysulfonyl)acetate	42138-30-7	Contains (regardless of intentional or impurities)	chemical products
12056	Copper trifluoromethanesulphonate, compound with benzene (2:1)	42152-46-5	Intentional addition / 1,000ppm	chemical products
12057	3-Pyridylhydrazine	42166-50-7	Intentional addition / 1%	chemical products
12058	Cobalt diiodate dihydrate	42183-35-7	Intentional addition / 1%	chemical products
12059	Cobalt diiodate tetrahydrate	42183-36-8	Intentional addition / 1%	chemical products
12060	Rhodium acetate	42204-14-8	Contains (regardless of intentional or impurities)	chemical products
12061	Chromate(2-), [2-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulfo]benzoato(2-)](2)-(4,5-dihydro-5-oxo-1,3-diphenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]-, sodium hydrogen	42208-99-1	Contains (regardless of intentional or impurities)	chemical products
12062	Potassium hydro(trisopropoxy)borate	42278-67-1	Intentional addition / 1%	chemical products
12063	1,1'-Biphenyl, triethyl-	42343-17-9	Intentional addition / 1%	chemical products
12064	Propanoic acid, 3,3'-(dimethylstannylene)bis(thio)]bis-, diisooctyl ester	42378-34-7	Contains (regardless of intentional or impurities)	chemical products
12065	4,4'-Methylenebiphenol oligomeric reaction products with 1-chloro-2,3-epoxypropane	42423-25-6	Intentional addition / 1%	chemical products
12066	Benzeneselenazolium, 3-ethyl-2-methyl-, salt with 4-methylbenzenesulfonic acid (1:1)	42423-89-2	Contains (regardless of intentional or impurities)	chemical products
12067	Bromonium, dimethyl-, (OC-6-11)-hexafluoroantimonate(1-)	42427-72-5	Contains (regardless of intentional or impurities)	chemical products
12068	Undecanoic acid, copper(2+) salt	42485-64-3	Intentional addition / 1,000ppm	chemical products
12069	(±)-2-Hydroxypropionitrile	42492-95-5	Intentional addition	chemical products
12070	2,3,5,6-Tetrahydro-2-methylphthalic anhydride	42498-58-8	Contains (regardless of intentional or impurities)	chemical products
12071	Dichlorohexafluoropropane	42560-98-5	Intentional addition	chemical products
12072	Tris[2-(2-ethoxyethoxy)ethyl] borate	42598-88-9	Intentional addition / 1%	chemical products
12073	Zirconium alloy, base, Zr 40-82, Ni 18-60	42612-06-6	Contains (regardless of intentional or impurities)	chemical products
12074	Sillicic acid, silver salt	42613-24-1	Intentional addition / 25%	chemical products
12075	Tetrahydro-2-hydroxy-4H-1,3,6,2-dioxazaborocine	42727-95-7	Intentional addition / 1%	chemical products
12076	Nickel, bis[2,3-bis(hydroxymino)-N-(2-methoxyphenyl)butanimidato]-	42739-61-7	Contains (regardless of intentional or impurities)	chemical products
12077	Copper, [2-(29H,31H-phthalocyaninylmethyl)-1H-isoindole-1,3(2H)-dionato(2-)-N29,N30,N31,N32]-	42739-64-0	Intentional addition / 1,000ppm	chemical products
12078	Benzene, 1,1'-sulfonylbis[3,5-dibromo-4-(2,3-dibromopropoxy)-	42757-55-1	Contains (regardless of intentional or impurities)	chemical products
12079	Boron, trifluoro(2-methyl-2-propanol)-, (T-4)-	42801-85-4	Intentional addition / 1%	chemical products
12080	1-Octene, 1-bromo-, (Z)-	42843-49-2	Intentional addition / 1,000ppm	chemical products
12081	3-Hexene, 3-bromo-, (E)-	42843-52-7	Intentional addition / 1,000ppm	chemical products
12082	Nickel, [1,3-dihydro-5,6-bis[(2-hydroxy-1-naphthalenyl)methylene]amino]-2H-benzimidazol-2-onato(2-)-N5,N6,O5,O6]-, (SP-4-2)-	42844-93-9	Contains (regardless of intentional or impurities)	chemical products
12083	N,N-(Diselenido)-2,1-phenylenebis(N-methylacetamide)	42905-02-2	Contains (regardless of intentional or impurities)	chemical products
12084	Aluminum, tris(2,2-dimethylpropyl)-	42916-36-9	Intentional addition / 1,000ppm	chemical products
12085	4-Octene, 1-bromo-	42976-83-0	Intentional addition / 1,000ppm	chemical products
12086	3-Heptene, 1-bromo-	42976-85-2	Intentional addition / 1,000ppm	chemical products
12087	Benzoic acid, methyl-, cobalt salt	42978-77-8	Intentional addition / 1,000ppm	chemical products
12088	2,3,4-Trimethoxybenzonitrile	43020-38-8	Intentional addition	chemical products
12089	3-(Pyrrol-1-yl)propionitrile	43036-06-2	Intentional addition	chemical products
12090	Acetic acid, ammonium copper(1+) salt (2:1:1)	43043-77-2	Intentional addition / 1,000ppm	chemical products
12091	Copper, [N,N,N,N'-tetraethyl-29H,31H-phthalocyanine-C-C-dimethaninato(2-)-N29,N30,N31,N32]-	43061-87-6	Intentional addition / 1,000ppm	chemical products
12092	Tetrabutylammonium (cyano-o)trihydroborate	43064-96-6	Intentional addition / 1%	chemical products
12093	4-[N-(2-Amino-3-cyano-5-pyrazinyl methyl)-N-methyl amino]benzoic acid	43111-44-0	Intentional addition	chemical products
12094	1-[4-(Chlorophenoxy)-3,3-dimethyl-1-(1,2,4-triazol-1-yl)butane	43121-43-3	Contains (regardless of intentional or impurities)	chemical products
12095	Methylpentane	43133-95-5	Intentional addition / 1,000ppm	chemical products
12096	Distannoxane, 1,1,3,3-tetramethyl-1,3-bis[(1-oxo-9-octadecyloxy)-, (Z,Z)-	43136-18-1	Contains (regardless of intentional or impurities)	chemical products
12097	Ethyl 2-[4-(chloromethyl)phenyl]propanoate	43153-93-3	Intentional addition / 1%	chemical products
12098	Bis(2-bromoethyl)ammonium bromide	43204-93-3	Contains (regardless of intentional or impurities)	chemical products
12099	Succinic acid, iron salt	43212-87-9	Intentional addition / 1%	chemical products
12100	Ferrate(1-), [N-(2-bis(carboxymethyl)amino)ethyl]-N-(2-hydroxyethyl)glycinato(3-)]-	43218-58-2	Intentional addition / 1%	chemical products
12101	Nickel(2+) sulfate (Ni(H2O)4)	44121-71-9	Intentional addition / 1,000ppm	chemical products
12102	(OC-6-22)-Tetraminedichlorocobalt	44433-52-5	Intentional addition / 1%	chemical products
12103	Dichlorodinitrosylmolybdenum	44513-97-5	Contains (regardless of intentional or impurities)	chemical products
12104	Hydrogen, pentacloromethoxyantimonate(1-)	44628-70-8	Contains (regardless of intentional or impurities)	chemical products
12105	1,1,3,3-Tetrabutylstannoxane	45234-42-2	Contains (regardless of intentional or impurities)	chemical products
12106	1-Octanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-heptafluoro-, ion(1-)	45298-90-6	Contains (regardless of intentional or impurities)	chemical products
12107	Distannoxane, 1,1,3,3-tetrabutyl-1,3-bis[(2-ethyl-1-oxohexyloxy)-	45314-70-3	Contains (regardless of intentional or impurities)	chemical products
12108	Anilinium iodide	45497-73-2	Contains (regardless of intentional or impurities)	chemical products
12109	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, monohydrochloride, monohydrochloride, (S)-	46002-56-6	Contains (regardless of intentional or impurities)	chemical products
12110	Platinum(1+), [(1,2,5,6-eta)-1,5-cycloctadiene][2,4-pentanedionato-O,O']-	46469-97-0	Contains (regardless of intentional or impurities)	chemical products
12111	Benzenamine, 4,4'-[methylenebis(oxyl)]bis-	46843-47-4	Contains (regardless of intentional or impurities)	chemical products
12112	[1,1'-Biphenyl]-4-yl-2-methyl-2-propenoate	46904-74-9	Contains (regardless of intentional or impurities)	chemical products
12113	Copper, iodo(triphenylphosphine)-	47107-74-4	Intentional addition / 1,000ppm	chemical products
12114	Benzenesulfonic acid, 4-dodecyl-, calcium salt	47236-10-2	Intentional addition / 1%	chemical products
12115	Manganese di(tolene-4-sulphonate)	47265-07-6	Contains (regardless of intentional or impurities)	chemical products
12116	Benzenesulfonic acid, 4-tetradecyl-	47377-16-2	Intentional addition / 1%	chemical products
12117	Stannane, triphenyl[(phenylsilyl)oxy]-	47562-29-8	Contains (regardless of intentional or impurities)	chemical products
12118	Diboron tetraphenyl pentaoxide	47689-51-0	Intentional addition / 1%	chemical products
12119	[2,2'-(4,8-Dichlorobenzo[1,2-d:4,5-d']bisoxazole-2,6-diyl)bis[4,6-dichlorophenolato]](2-)nickel	47726-82-5	Contains (regardless of intentional or impurities)	chemical products
12120	Tin phthalocyanine	47823-32-5	Intentional addition / 1,000ppm	chemical products
12121	Cuprate(1-), [N,N-bis(carboxymethyl)glycinato(3-)-N,O,O,O']-, sodium monohydrate, (T-4)-	48138-75-6	Intentional addition / 1,000ppm	chemical products
12122	3-Methacrylamidophenylboronic acid	48150-45-4	Intentional addition / 1%	chemical products
12123	Neodecanoic acid, tin(2+) salt	49556-16-3	Contains (regardless of intentional or impurities)	chemical products
12124	Benzene-1,2,4-tricarboxylic acid, compound with 2-methyl-1H-imidazole-1-propionitrile (1:1)	49556-76-5	Intentional addition	chemical products
12125	Trithiocyloheptadiene-3,4,6,7-tetranitrile	49561-89-9	Intentional addition	chemical products
12126	4-Octyloxynitrobenzene	49562-76-7	Contains (regardless of intentional or impurities)	chemical products
12127	1,2,4-Benzenetricarboxylic acid, compound with 2-undecyl-1H-imidazole-1-propanenitrile	49577-56-2	Intentional addition	chemical products
12128	Bis(indenyl)hafnium dichloride	49596-05-6	Intentional addition / 1%	chemical products
12129	Cobalt, dibromobis[tris(3-methylphenyl)phosphine]-, (T-4)-	49651-10-7	Intentional addition / 1,000ppm	chemical products
12130	Hexanoic acid, 3,5,5-trimethyl-, cobalt(2+) salt	49676-83-7	Intentional addition / 1,000ppm	chemical products
12131	Trisdibromophenyl phosphite	49680-63-3	Intentional addition / 900ppm	chemical products
12132	Benzene, 1,1'-oxybis-, tribromo derivative	49690-94-0	Intentional addition / 1,000ppm	chemical products
12133	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, cadmium salt	49707-39-3	Contains (regardless of intentional or impurities)	chemical products
12134	D-Gluconic acid, compound with strychnidin-10-one (1:1)	49719-63-3	Contains (regardless of intentional or impurities)	chemical products
12135	Strychnidin-10-one, sulfate (1:1)	49719-64-4	Contains (regardless of intentional or impurities)	chemical products
12136	3-Pyridinacarbitrile, 1-ethyl-1,2-dihydro-6-hydroxy-5-[(4-methoxy-2-nitrophenyl)azo]-4-methyl-2-oxo-	49744-42-5	Contains (regardless of intentional or impurities)	chemical products
12137	Cadmate(1-), [N,N-bis(carboxymethyl)glycinato(3-)-N,O,O,O']-, potassium, (T-4)-	49784-42-1	Contains (regardless of intentional or impurities)	chemical products
12138	Hydrogen, [N,N-bis(carboxymethyl)glycinato(3-)-N,O,O,O']cadmate	49784-44-3	Contains (regardless of intentional or impurities)	chemical products
12139	Cobalt tetra[benzo-(p)thaloyl]porphyrizine-tetraene	50136-28-2	Intentional addition / 1%	chemical products

(Appendix table 1) MISUMI Specified Chemical Substances

Table with 5 columns: #, Substance Name, CAS-No, Misumi Standards (numbers as threshold), and Applicable Item. The table lists numerous chemical substances such as 2-Pentene, 5-bromo-, (Z)-, Arsenic triiodide, Iron, 1,8,20-dihydro-8,20-diphenyl-5,24,12,17-diimino-7,10,22,19-dinitridiodibenzofuran, Neodecanoic acid, copper salt, Chromic acid, Benzenesulfonic acid, 4-chloro-2-[[2-hydroxy-3-[[[2-(methoxyphenyl)amino]carbonyl]-1-naphthalenyl]azo]-5-methyl-, barium salt (2:1), Distannoxane, dihydroxy-, Quinolinium, 1-ethyl-2-[[3-ethyl-5-methoxy-2(3H)-benzosenelenazolyldene]methyl]-6-methoxy-, iodide, Molybdenum(VI) oxalate-1,4-bis(methylsulfonyl)phenyl-, Ethane, 2-bromo-1,4-bis(methylsulfonyl)phenyl-, N-3,5-Dichlorophenyl-5-methyl-5-vinyl-1,3-oxazolidine-2,4-dione, Chromate(1-), bis[1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen, Chromate(3-), bis[2-[[2-hydroxy-6-sulfo-1-naphthalenyl]azo]benzoato(3-)]-, trihydrogen, Diisopropyl-1,3-dithiolan-2-ylidenediammonate, Dichlorobis[1,1'-thiobis(benzene)]platinum, Cobaltate(1-), bis[4-hydroxy-3-(2-hydroxy-1-naphthalenyl)azobenzensulfonamido(2-)]-, hydrogen, Acid Violet 78, Benzenediazonium, 2,5-dibutoxy-4-(4-morpholinyl)-, tetrafluoroborate(1-), 1,3-Dichlorodibenzo-p-dioxin, 2,3,7,8-Tetrabromodibenzo-p-dioxin, 1,3,7,8-Tetrachlorodibenzodioxin, Hexane, 1,4-dichloro-, Manganese chloride (MnCl2), Cadmium, bis[N,N-bis(carboxymethyl)glycinate(3-)]tri-, Tri-μ-carbonyltetracarboxyl(pentacarbonyldicobalt)dirhodium, Strychnidin-10-one, mono(3,4-dimethylbenzenesulfonate), Strychnidin-10-one, mono(2,5-dimethylbenzenesulfonate), Strychnidin-10-one, mono(4-hydroxy-2,3-dimethylbenzenesulfonate), Strychnidin-10-one, mono(2-hydroxy-4,6-dimethylbenzenesulfonate), Strychnidin-10-one, mono(2,6-dimethyl-3-[[phenylsulfonyl]oxy]benzenesulfonate), Strychnidin-10-one, mono(4-[[[2,4-dimethylphenyl]sulfonyl]oxy]benzenesulfonate), Strychnidin-10-one, compound with 4-sulfophenyl 3,4-dimethylbenzenesulfonate (1:1), Strychnidin-10-one, mono(3,5-dimethyl-4-[[[4-methylphenyl]sulfonyl]oxy]benzenesulfonate), 4-Oxo-4H-1-benzopyran-3-carbonitrile, Diisooctyl 3,3'-[[diocetylstannylene]bis(thio)]dipropionate, Iron, 1,7,16-dihydrodibenzol[b,1,4,8,11]tetraazacyclotetradecano(2-)-N5,N9,N14,N18]-, (SP-4-1)-, Hexasodium hexatriacontam-μ-oxoocatadecaobis[μ,9-μ-phosphato(3-)-O:O:O':O':O':O':O']octadecamolybdate(6-), Molybdenum strontium oxide (MoSr2O4), 4-(Trifluoromethoxy)benzyl bromide, Benzeneselenazolium, 2-[[2-methyl-3-(3-(4-sulfobutyl)-2(3H)-benzenoselenazolyldene]-1-propenyl]-3-(4-sulfobutyl)-, hydroxide, inner salt, sodium salt, Benzene sulfonic acid, undecyl-, Barium sulfide (Ba(Sx)), Hydrogen sulfide (H2(Sx)), 1-(3-Dihydro-2H-benzimidazole-2-thione-S)iodocopper, 1-Chloroethyl chloroformate, (SP-4-1)-Bis(2-(hydroxy-O-benzaldehyde oximate-N)nickel), Hexane, 1-bromo-3,5,5-trimethyl-, Yttrium aridosulfate, Chromium zinc oxide, Chromium chloride, basic, Indium tin oxide, Iron selenide, Stannate(2-), [[N,N'-1,2-ethanediybis(N-carboxymethyl)glycinate(4-)] salt], Poly(oxy-1,2-ethanediy), alpha-(1-oxo-2-propenyl)-omega-(nonylphenoxy)-, Heptane, methyl-, 1,3-Benzenediamine, ar-methyl-, dihydrochloride, Trichlorobutene, Ferrate(4-), hexakis(cyano-C)-, iron(3+) sodium (1:1:1), (OC-6-11)-, Acid Blue 171, 4-Phenoxybenzeneboronic acid, 1,4-Benzenedicarboxylic acid, monomethyl ester, cobalt(2+) salt, Benzenamine, 2-methyl-5-nitro-, monohydrochloride, 3-(Triphenylplumbyl)-1H-pyrazole, Propane, 2,2-tellurabis-, 1,6-Bis(isopropyl)naphthalene, Pentane, 1-bromo-3-methyl-, Hexanoic acid, 2-ethyl-, trianhydride with boric acid (H3BO3), 1,3,2-Dioxastibolane, 2,2'-[[1,2-ethanediybis(oxy)]bis-, Copper(2+), amminepentaqua, Copper(2+), diamminetetraqua-, Chromate(1-), bis[2-(3-chlorophenyl)-2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]-, sodium, Sodium N-[2-bis(carboxymethyl)amino]ethyl-N-(2-hydroxyethyl)glycinate(4-)]ferrate(1-), Barium trisulfide, 2,3,7,8-Tetrachlorodibenzofuran, Metolachlor, Acetamide, 2-chloro-N-(2,6-diethylphenyl)-N-(2-propoxyethyl)-, Chromium acrylate, Nickel acrylate, Boric acid, cadmium salt, 3,5,7-Triaza-1-azoniatricyclo[3.3.1.1(3,7)]decane, 1-(3-chloro-2-propenyl)-, chloride, (Z)-, Ethane, 2-bromo-2-chloro-1,1,1-trifluoro-, (R)-, Ethane, 2-bromo-2-chloro-1,1,1-trifluoro-, (S)-, Blastocidin S, hydrochloride, (S)-isomer, Nickel, [[1,2-ethanediybis(carbamodithioato)](2-)]-, mixture with N,N'-bis(2-aminoethyl)-1,2-ethanediamine and [[1,2-ethanediybis(carbamodithioato)](2-)]zinc, 1,1-Dimethyl-3-oxobutylammonium hydrogen oxalate hydrate, Dodecyl 3,5-dibutyl-9-oxo-10-oxa-4,6-dithia-5-stannadocosanoate, Stannane, bis(dodecylthio)dimethyl-, 2,2,7,4-Phenylperidine-4-carbonitrile hydrochloride, Titanium boride (TiB2), Antimony iodide, 3-(Bromomethyl)phenylboronic acid, Propanedinitrile, 1,2-[[2-[[4(dimethylamino)phenyl]ethyl]-6-methyl-4H-pyran-4-ylidene]-, Trimethyl(trimethylphosphine)indium, Manganese hydrogen phosphate, Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, [R-(R\*)]-2,3-dihydroxybutanedioate (2-), Oxalic acid, scandium salt, Phosphomolybdic acid, Nickel, bis[1-[4-(diethylamino)phenyl]-2-phenyl-1,2-ethenedithiolato(2-)]-, S,S'-, Nickel(2+), hexaammine-, dihydroxide, (OC-6-11)-, Hydrogen bis[3-[[4,5-dihydro-4-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzene-1-sulphonamido(2-)]chromate(1-), Sodium [29H,31H-phthalocyaninesulphonato(3-)-N29,N30,N31,N32]cuprate(1-), Cimetidine, 1,3-Dibromo-2-chloropropane, Strychnidin-10-one, mononitrate, mixture with 2-aminoethylcarbamiodithioate dihydrobromide and 5-methoxy-1H-indole-3-ethanaminemonohydrochloride, Nonane, 2,4,8-tetrachloro-6-methyl-, Di-n-octyltin bis(p-tert-butylbenzoate), Cuprate(1-), [C-chloro-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen, Sodium dichloroisocyanurate dihydrate, Propane, 1,3-dibromo-1,3-difluoro-, 1,3-Dibromo-1-fluoropropane, Stannane, butyloxo-, (R)-Epichlorohydrin, Zirconium(4+) neodecanoate, Hydrogen sulfide (H4S), Fenvalerate, 3-Phenoxybenzyl cyanide, Uranium hydride, Zirconium carbide, Copper, (1,3-dihydro-2H-benzimidazole-2-thione)iodo-, Selenocyanic acid, 2-nitrophenyl ester, Hydrogen sulfide (H8S), (OC-6-11)-, 1-Octene, 1-bromo-, (E)-, Decane, 1,1,1,3-tetrachloro-, 7-Amino-2-naphthol hydrochloride, 1,2-Benzenedicarbonyl, 3-nitro-

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
12266	3-(Phenylthio)phthalonitrile	51762-68-6	Intentional addition	chemical products
12267	9-Oxo-9H-thioxanthene-3-carbonitrile, 10,10-dioxide	51762-94-8	Intentional addition	chemical products
12268	1-Eicosanol, (1-4)-, compound with trifluoroborane (1:1)	51791-80-1	Intentional addition / 1%	chemical products / 1%
12269	1-Docosanol, compound with trifluoroborane (1:1)	51791-81-2	Intentional addition / 1%	chemical products
12270	3-Ethyl-2-[3-(3-ethyl-5,6-dimethyl-3H-benzoselenazol-2-ylidene)-2-methylprop-1-enyl]-5,6-dimethylbenzoselenazolium bromide	51799-69-0	Contains (regardless of intentional or impurities)	chemical products
12271	Poly(oxy-1,2-ethanediyloxy)-alpha-(nonylphenyl)-omega-hydroxy- phosphate	51811-79-1	Intentional addition / 1,000ppm	chemical products
12272	Ocetyl (Z,Z,2,6-butyl-6-[[4-(octyloxy)-1,4-dioxabut-2-enyl]oxy]-4,8,11-trioxo-5,7,12-trioxo-6-stannaicoso-2,9-dienate)	51815-14-6	Contains (regardless of intentional or impurities)	chemical products
12273	Neodecanoic acid, iron salt	51818-55-4	Intentional addition / 1%	chemical products
12274	Neodecanoic acid, nickel salt	51818-56-5	Contains (regardless of intentional or impurities)	chemical products
12275	Cuprate(1-), [2-(2,4-dihydroxyphenyl)azo]-4-hydroxybenzenesulfonate(3-)-, sodium	51819-19-3	Intentional addition / 1,000ppm	chemical products
12276	Thallium phosphate	51833-34-2	Contains (regardless of intentional or impurities)	chemical products
12277	Cobalt(II) carbonate hydroxide (2:3) monohydrate	51839-24-8	Intentional addition / 1%	chemical products
12278	Carbonic acid, zinc salt, basic	51839-25-9	Intentional addition / 25%	chemical products
12279	Aluminum molybdate	51845-71-7	Intentional addition / 1%	chemical products
12280	Dihydrogen hexahydroxyplatinate	51850-20-5	Contains (regardless of intentional or impurities)	chemical products
12281	Triethoxy(3,3,4,4,5,5,6,6,7,7,8,8,8-tridecafluorooctyl)silane	51851-37-7	Contains (regardless of intentional or impurities)	chemical products
12282	Diisopropyl allylboronate	51851-79-7	Intentional addition / 1%	chemical products
12283	Aniline oxalate	51855-90-4	Contains (regardless of intentional or impurities)	chemical products
12284	Pigment Red 90	51868-24-7	Contains (regardless of intentional or impurities)	chemical products
12285	Manganese lactate	51877-53-3	Contains (regardless of intentional or impurities)	chemical products
12286	(+)-trans-Permethrin	51877-74-8	Intentional addition / 1%	chemical products
12287	Sodium bis[8-amino-1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalato(2-)]chromate(1-)	51888-17-6	Contains (regardless of intentional or impurities)	chemical products
12288	Disodium antimonate (Na2Sb4O7)	51900-05-1	Contains (regardless of intentional or impurities)	chemical products
12289	Copper, compound with lanthanum and nickel (4:1:1)	51912-52-8	Contains (regardless of intentional or impurities)	chemical products
12290	Nickel, bis[3-[(4-chlorophenyl)azo]-2,4(1H,3H)-quinolinedionato]-	51931-46-5	Contains (regardless of intentional or impurities)	chemical products
12291	Poly(oxy-1,2-ethanediyloxy)-alpha-(2-nonylphenyl)-omega-hydroxy-	51938-25-1	Intentional addition / 1,000ppm	chemical products
12292	Nickel(II) carbonate monohydrate	51944-07-1	Contains (regardless of intentional or impurities)	chemical products
12293	1-Butyl-2,8,9-trioxo-5-aza-1-stannabicyclo[3.3.3]undecane	51952-23-9	Contains (regardless of intentional or impurities)	chemical products
12294	2-Pentene, 5-bromo-	51952-42-2	Intentional addition / 1,000ppm	chemical products
12295	Barium carbonate-13C	51956-33-3	Intentional addition	chemical products
12296	2,3,7-Tribromobenzo-4-dioxin	51974-40-4	Intentional addition / 100ppm	chemical products
12297	Bis(2-methoxycarbonylphenoxy) tin	51983-04-1	Contains (regardless of intentional or impurities)	chemical products
12298	Chlorowax	51990-12-6	Intentional addition / 100ppm	chemical products
12299	Blasticidin S, dodecyl sulfate, (S)-isomer	52009-45-7	Intentional addition / 1%	chemical products
12300	Blasticidin S, methyl sulfate, (S)-isomer	52009-46-8	Intentional addition / 1%	chemical products
12301	Nickel alloy, base, Ni,Ti (Nitinol)	52013-44-2	Contains (regardless of intentional or impurities)	chemical products
12302	Benzene diazonium, 2,5-dimethoxy-4-(1-pyrrolidinyl)-, tetrafluoroborate(1-)	52018-21-0	Intentional addition / 1%	chemical products
12303	Benzene diazonium, 2,5-dimethoxy-4-(4-morpholinyl)-, tetrafluoroborate(1-)	52018-28-7	Intentional addition / 1%	chemical products
12304	Nickel [R(R*)]-tartrate	52022-10-3	Contains (regardless of intentional or impurities)	chemical products
12305	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, iron(3+) sodium salt	52031-09-1	Intentional addition / 1%	chemical products
12306	Phenylhydrazinium sulphate (2:1)	52033-74-6	Contains (regardless of intentional or impurities)	chemical products
12307	Zirconium oxide sulfate	52037-76-0	Contains (regardless of intentional or impurities)	chemical products
12308	Nickel O-isopropylidithiocarbonate	52057-73-5	Contains (regardless of intentional or impurities)	chemical products
12309	Manganese, [[1,2-ethanediyloxy]bis(carbamodithioato)](2-)-, mixture with methyl 1H-benzimidazol-2-ylcarbamate	52080-81-6	Contains (regardless of intentional or impurities)	chemical products
12310	MSMA mixture with Prometryne	52081-02-4	Intentional addition / 100ppm	chemical products
12311	Dibutyltin phosphite	52082-48-1	Contains (regardless of intentional or impurities)	chemical products
12312	1,5-Naphthalenedisulfonic acid, 3-amino-, sodium salt	52085-24-2	Contains (regardless of intentional or impurities)	chemical products
12313	Silicic acid, magnesium zirconium salt	52110-05-1	Contains (regardless of intentional or impurities)	chemical products
12314	Strontium molybdate	52110-07-3	Intentional addition / 1%	chemical products
12315	Ammonium chromate	52110-79-2	Contains (regardless of intentional or impurities)	chemical products
12316	Iron phthalate (2:3)	52118-12-4	Intentional addition / 1%	chemical products
12317	Benzoic acid, 2-hydroxy-, methyl ester, tin(2+) salt	52120-23-7	Intentional addition / 1,000ppm	chemical products
12318	Tin di(octanoate)	52120-31-7	Contains (regardless of intentional or impurities)	chemical products
12319	1-Octadecanol, tin(2+) salt	52120-32-8	Intentional addition / 1,000ppm	chemical products
12320	Arsenic selenide (As4Se4)	52128-83-7	Contains (regardless of intentional or impurities)	chemical products
12321	Trimethyltin cinnamate	52132-44-2	Contains (regardless of intentional or impurities)	chemical products
12322	Stannane, tris(decylthio)methyl-	52165-03-4	Contains (regardless of intentional or impurities)	chemical products
12323	2,4-Bis(tert-butyl)-6-[(2-nitrophenyl)azo]phenol	52184-14-2	Intentional addition / 1%	chemical products
12324	C.I. Pigment Red 58,4	52233-00-8	Intentional addition / 1%	chemical products
12325	Manganese, [[1,2-ethanediyloxy]bis(carbamodithioato)](2-)-, mixture with 2,5-dimethyl-N-phenyl-3-furancarboxamide and [[1,2-ethanediyloxy]bis(carbamodithioato)](2-)-zinc	52233-09-7	Contains (regardless of intentional or impurities)	chemical products
12326	Chromate(1-), bis[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-hydrogen	52256-37-8	Contains (regardless of intentional or impurities)	chemical products
12327	Cobaltate(1-), bis[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-hydrogen	52256-38-9	Intentional addition / 1,000ppm	chemical products
12328	Chromate(1-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](2-)-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-hydrogen	52256-39-0	Contains (regardless of intentional or impurities)	chemical products
12329	Chromate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)](4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]-hydrogen	52256-40-3	Contains (regardless of intentional or impurities)	chemical products
12330	Titanium tetrachlorotetrakis[4-[[4-(methoxyphenyl)azo]methyl]phenolato]bis(nickel)-	52261-08-2	Contains (regardless of intentional or impurities)	chemical products
12331	Tin fluorophosphate	52262-58-5	Intentional addition / 1,000ppm	chemical products
12332	Neodecanoic acid, cobalt(2+) salt	52270-44-7	Intentional addition / 1,000ppm	chemical products
12333	Iron(2+) neodecanoate	52270-45-8	Intentional addition / 1%	chemical products
12334	Cobaltate(1-), bis[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-hydrogen	52277-69-7	Intentional addition / 1,000ppm	chemical products
12335	Chromate(1-), [1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)](1-)-[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-hydrogen	52277-71-1	Contains (regardless of intentional or impurities)	chemical products
12336	Hydrogen [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](1-)-[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]cobaltate(1-)	52277-72-2	Intentional addition / 1,000ppm	chemical products
12337	Cobaltate(1-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](1-)-[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-hydrogen	52277-73-3	Intentional addition / 1,000ppm	chemical products
12338	Hydrogen [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](1-)-[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]chromate(1-)	52277-74-4	Contains (regardless of intentional or impurities)	chemical products
12339	Manganate(2-), [[N,N'-1,2-ethanediyloxy]bis(N-(carboxymethyl)glycinate)](4-)-N,N',O,O',ON,ON]-, (OC-6-21)-	52279-49-9	Contains (regardless of intentional or impurities)	chemical products
12340	Benzenamine, 4,4'-thiobis-, dihydrochloride	52285-42-4	Intentional addition / 1,000ppm	chemical products
12341	Bis(ethylcyclopentadienyl)cobalt(III)hexafluorophosphate	52308-79-9	Intentional addition / 1%	chemical products
12342	alpha-Hydroxy-m-phenoxyphenylacetone nitrile	52315-06-7	Intentional addition	chemical products
12343	Cypermethrin	52315-07-8	Contains (regardless of intentional or impurities)	chemical products
12344	Titanium dichlorobis(dimethyl orthoborate-O)-, (T-4)-	52329-27-8	Intentional addition / 1%	chemical products
12345	Triammonium triion tetrachlorate	52338-55-7	Intentional addition / 1%	chemical products
12346	Benzoic acid, 2-methyl-, barium salt	52337-77-6	Contains (regardless of intentional or impurities)	chemical products
12347	Benzoic acid, 2-methyl-, cadmium salt	52337-78-7	Contains (regardless of intentional or impurities)	chemical products
12348	Strychnidin-10-one, mono-(R)-(2-dibenzofuranyl)sulfinyl acetate]	52340-19-9	Contains (regardless of intentional or impurities)	chemical products
12349	(+)-trans-Permethrin	52341-32-9	Intentional addition / 1%	chemical products
12350	(+)-cis-Permethrin	52341-33-0	Intentional addition / 1%	chemical products
12351	Indium borate	52350-34-2	Intentional addition / 1%	chemical products
12352	[1,1-Biphenyl]-4-carbonitrile, 4'-(octyloxy)-	52364-73-5	Intentional addition	chemical products
12353	Zirconium(2+) neodecanoate	52382-29-3	Contains (regardless of intentional or impurities)	chemical products
12354	N,N'-Bis(2-Chloroethyl)benzylamine hydrochloride	52386-28-4	Intentional addition / 1%	chemical products
12355	Copper, [pentadecachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-	52418-31-2	Intentional addition / 1,000ppm	chemical products
12356	1,3,5-Triazine-2,4,6(1H,3H,5H)-trione, 1,3,5-tris(2,3-dibromopropyl)-	52434-90-9	Intentional addition / 900ppm	chemical products
12357	Platinum, diaquatetrahydroxy-	52438-26-3	Contains (regardless of intentional or impurities)	chemical products
12358	Copper O,O'-di (2-ethylhexyl) dithio-phosphate	52454-54-3	Intentional addition / 1,000ppm	chemical products
12359	Chromate(1-), triaqua[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonate(3-)]-, sodium	52455-30-8	Contains (regardless of intentional or impurities)	chemical products
12360	Boric acid (HBO2), ammonium salt	52458-41-0	Intentional addition / 1%	chemical products
12361	Bis(2-hydroxyethyl)dithiocarbamate-S,S']nickel	52486-98-3	Contains (regardless of intentional or impurities)	chemical products
12362	Bis[bis(2-hydroxyethyl)dithiocarbamate-S,S']nickel	52486-99-4	Contains (regardless of intentional or impurities)	chemical products
12363	Silicic acid, aluminum zinc salt	52488-90-1	Intentional addition / 25%	chemical products
12364	Lanthanum vanadate	52489-20-0	Intentional addition / 1%	chemical products
12365	Nickel(2+) methacrylate	52496-91-0	Contains (regardless of intentional or impurities)	chemical products
12366	Benzenamine, 4,4'-carbonimidoylbis[N,N'-dimethyl]-, sulfate	52497-46-8	Contains (regardless of intentional or impurities)	chemical products
12367	Nickel vanadium oxide (NiV2O6)	52502-12-2	Contains (regardless of intentional or impurities)	chemical products
12368	Ammonium antimony fluoride	52503-06-7	Contains (regardless of intentional or impurities)	chemical products
12369	Acetic acid, copper(2+) salt, basic	52503-64-7	Intentional addition / 1,000ppm	chemical products
12370	Hydrogen 2-[[[5,6-dimethyl-3-(3-sulphonatopropyl)-3H-benzoselenazol-2-ylidene]methyl]but-1-enyl]-5,6-dimethyl-3-(3-sulphonatopropyl)benzoselenazolium, sodium salt	52513-84-5	Contains (regardless of intentional or impurities)	chemical products
12371	L-Ascorbic acid, mixture with 3-[[4-amino-2-methyl-5-pyrimidinyl]methyl]-5-(2-hydroxyethyl)-4-methylthiazolium chloride monohydrochloride and strychnidin-10-one mononitrate	52539-51-2	Contains (regardless of intentional or impurities)	chemical products
12372	1-Tetradecanol, hydrogen sulfate, manganese(2+) salt	52562-37-5	Contains (regardless of intentional or impurities)	chemical products
12373	Acetamide, N-[[bis(2-methoxyethylamino)-2-[[2-cyano-4,6-dinitrophenyl]azo]phenyl]-	52583-35-4	Contains (regardless of intentional or impurities)	chemical products
12374	White fuming nitric acid	52583-42-3	Contains (regardless of intentional or impurities)	chemical products
12375	N-[[2-[[2,6-Dibromo-4-nitrophenyl]azo]-5-(diethylamino)phenyl]acetamide	52583-53-6	Contains (regardless of intentional or impurities)	chemical products
12376	Chromate(2-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonate(3-)](1-)-[2-hydroxy-5-(phenylazo)phenyl]azo]-2-naphthalenolato(2-)]-, disodium	52587-68-5	Contains (regardless of intentional or impurities)	chemical products
12377	Bis(2-aminoethanolato-N,O)dioxomolybdenum	52595-44-5	Contains (regardless of intentional or impurities)	chemical products
12378	Bis(diethylidithiocarbamate-S,S')nickel	52610-81-8	Contains (regardless of intentional or impurities)	chemical products
12379	Sodium tellurate	52623-77-5	Contains (regardless of intentional or impurities)	chemical products
12380	Chloric acid, sodium salt, mixture with boric acid (HBO2) sodium salt	52623-84-4	Intentional addition / 1%	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
12381	Manganese, [[1,2-ethanedithiolylbis(carbamodithioato)](2-)]-, mixture with dimethyl [[1,2-phenylenebis(iminocarbonothioyl)]bis(carbamate)]	52623-88-8	Contains (regardless of intentional or impurities)	chemical products
12382	Benzoic acid, 3,5-bis(1,1-dimethylethyl)-4-hydroxy-, nickel(2+) salt (2:1)	52625-25-9	Contains (regardless of intentional or impurities)	chemical products
12383	Acetic acid, 2,2-[[1,1,3,3-tetrabutyl-1,3-distannathianediyl]bis(thio)]bis-, diisooctyl ester	52628-34-9	Contains (regardless of intentional or impurities)	chemical products
12384	Permethrin	52645-53-1	Contains (regardless of intentional or impurities)	chemical products
12385	Heptane, 1-bromo-6-methyl-	52648-04-1	Intentional addition / 1,000ppm	chemical products
12386	1-[4-Nitrophenyl]cyclopentane-1-carboxylic acid	52648-77-8	Contains (regardless of intentional or impurities)	chemical products
12387	Tris(mu-[methanedisulphonato(2-)]dialuminum	52667-15-9	Intentional addition / 1,000ppm	chemical products
12388	Ethyl [(Z,Z,2)-9-[[4-ethoxy-1,4-dioxobut-2-enyl]oxy]-9-octyl-4,7,11-trioxo-3,8,10-trioxo-9-stannatetradeca-5,12-dien-14-ate	52671-36-0	Contains (regardless of intentional or impurities)	chemical products
12389	Dihydrogen hexachloroplatinate, compound with 1,1,3,3-tetramethyl-1,3-divinylsiloxane	52672-74-9	Contains (regardless of intentional or impurities)	chemical products
12390	Chromate(1-), [4-[[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulfonylphenyl)-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(4-)]-], sodium	52677-44-8	Contains (regardless of intentional or impurities)	chemical products
12391	Hydrogen bis[[2-hydroxy-3,5-dinitrophenylazo]-3-(phenylcarbamoyl)-2-naphtholato]chromic(III) acid	52677-57-3	Contains (regardless of intentional or impurities)	chemical products
12392	Barium stannate	52682-64-1	Intentional addition / 1,000ppm	chemical products
12393	Hydrogen 2-[2-methyl-3-[[3-(3-sulphonatopropyl)-3H-benzoselenazol-2-ylidene]prop-1-enyl]-3-(3-sulphonatopropyl)benzoselenazolium	52685-95-7	Contains (regardless of intentional or impurities)	chemical products
12394	Cyclohexyl cyanacetate	52688-11-6	Intentional addition	chemical products
12395	Bis(dibutylthiocarbamate-S,S')copper	52691-95-9	Intentional addition / 1,000ppm	chemical products
12396	[1,1'-Biphenyl]-4-carbonitrile, 4'-octyl-	52709-84-9	Intentional addition	chemical products
12397	Strychnidin-10-one, monohydrobromide	52714-88-2	Contains (regardless of intentional or impurities)	chemical products
12398	Strychnidin-10-one, compound with 2,4,6-trinitrophenol	52714-96-2	Contains (regardless of intentional or impurities)	chemical products
12399	Stannane, bis(1,1'-biphenyl)-2-oxo]dibutyl-	52722-81-3	Contains (regardless of intentional or impurities)	chemical products
12400	Rhodium(3+) 2,6,6-trimethylbicyclo[3.1.1]heptanethiolate	52729-53-0	Contains (regardless of intentional or impurities)	chemical products
12401	Cobaltate(1-), [29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, sodium	52729-67-6	Intentional addition / 1,000ppm	chemical products
12402	Calcium arsenite	52740-16-6	Contains (regardless of intentional or impurities)	chemical products
12403	Strychnidin-10-one, monohydroxide	52748-69-3	Contains (regardless of intentional or impurities)	chemical products
12404	m-(Trifluoromethoxy)benzotrile	52771-22-9	Intentional addition	chemical products
12405	Barium chloride hexahydrate	52788-96-2	Intentional addition / 1,000ppm	chemical products
12406	Cobalt, dibromotris(trimethylphosphine)-, (TB-5-22)-	52810-40-9	Intentional addition / 1%	chemical products
12407	3-Bromo-2,2-bis(bromomethyl)propanoic acid	52813-48-6	Contains (regardless of intentional or impurities)	chemical products
12408	Copper dihydroxybenzoate	52856-54-9	Intentional addition / 1,000ppm	chemical products
12409	Vanadium alloy, base, V, Al	52863-01-1	Intentional addition / 1%	chemical products
12410	Barium aluminum titanate	52869-91-7	Intentional addition	chemical products
12411	Barium calcium titanate	52869-93-9	Intentional addition	chemical products
12412	Ethylene bis(5,6-dibromonorbornane-2,3-dicarboximide)	52907-07-0	Intentional addition / 900ppm	chemical products
12413	Cerium tin oxide	52907-84-3	Intentional addition / 1,000ppm	chemical products
12414	Deltamethrin	52918-63-5	Contains (regardless of intentional or impurities)	chemical products
12415	Hexane, 3,4-dimethyl-, (R,R)-(±)-	52919-17-2	Intentional addition / 1%	chemical products
12416	Copper boride (CuB24)	52933-45-6	Intentional addition / 1,000ppm	chemical products
12417	Iron zirconium oxide (Fe2ZrO5)	52933-62-7	Contains (regardless of intentional or impurities)	chemical products
12418	Yttrium phosphovanadate	52934-13-1	Intentional addition / 1%	chemical products
12419	Barium molybdate	52934-88-0	Intentional addition / 1,000ppm	chemical products
12420	Hexane, 3,4-dimethyl-, (R,S)-	52949-33-4	Intentional addition / 1%	chemical products
12421	Cuprate(4-), [4-hydroxy-7-[[4-[[2-hydroxyethylamino]-6-[[5-hydroxy-6-[[2-hydroxy-5-sulfonylphenyl]azo]-7-sulfo-2-naphthalenyl]amino]-1,3,5-triazin-2-yl]amino]-3-[[4-methoxy-2-sulfonylphenyl]azo]-2-naphthalenesulfonato(6-)]-], tetrasodium	52953-36-3	Intentional addition / 1,000ppm	chemical products
12422	Dihydrogen [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]chromate(2-)	52953-39-6	Contains (regardless of intentional or impurities)	chemical products
12423	Chromate(2-), [4-[[4-[[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-4-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-4-[[[3,5-dichloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-1-phenyl-3H-pyrazol-3-onato(2-)]-], dihydrogen	52953-41-0	Contains (regardless of intentional or impurities)	chemical products
12424	Dihydrogen [1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphtholato(2-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]naphthalene-1-sulphonato(3-)]chromate(2-)	52953-42-1	Contains (regardless of intentional or impurities)	chemical products
12425	3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14-Tetraacosafuoro-13-(trifluoromethyl)tetradecyl acrylate	52956-82-8	Intentional addition / 100ppm	chemical products
12426	Pentadecane, 7-(bromomethyl)-	52987-43-0	Intentional addition / 1,000ppm	chemical products
12427	3-(Bromomethyl)-1,2,4,5-tetrafluorobenzene	53001-73-3	Intentional addition / 1,000ppm	chemical products
12428	Salinomycin	53003-10-4	Intentional addition / 1%	chemical products
12429	Strychnidin-10-one, mono[bis(N,N-dimethylbenzylamine)tetrakis(thiocyanato-N)chromate(1-)]	53021-66-2	Contains (regardless of intentional or impurities)	chemical products
12430	Dihydrogen [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]-[2-hydroxy-5-methoxyphenyl]azo]-4,6-dinitrophenolato(2-)]chromate(2-)	53036-44-5	Contains (regardless of intentional or impurities)	chemical products
12431	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, trihydrogen	53036-47-8	Contains (regardless of intentional or impurities)	chemical products
12432	Propanoic acid, 3,3',3'-[[methylstannylidene]tris(thio)]tris-, triisooctyl ester	53040-42-9	Contains (regardless of intentional or impurities)	chemical products
12433	Copper monoethanolamine	53044-06-7	Intentional addition / 1,000ppm	chemical products
12434	1-Pentene, 3-bromo-	53045-71-9	Intentional addition / 1,000ppm	chemical products
12435	Iodomethyl pivalate	53064-79-2	Contains (regardless of intentional or impurities)	chemical products
12436	4,4'-Methylenebisbenzenediazonium bis(tetrafluoroborate)	53091-46-6	Intentional addition / 1%	chemical products
12437	Triisooctyl 4,4',4'-[[[butylstannylidene]tris(oxo)]tris(4-oxoisocrotonate)]	53100-69-9	Contains (regardless of intentional or impurities)	chemical products
12438	Cuprate(1-), [N,N-bis(carboxymethyl)glycinato(3-)-N,O,O']-, sodium, (T-4)-	53108-47-7	Intentional addition / 1,000ppm	chemical products
12439	Cobaltate(1-), [N,N-bis(carboxymethyl)glycinato(3-)-N,O,O']-, sodium, (T-4)-	53108-49-9	Intentional addition / 1%	chemical products
12440	Cobaltate(1-), [N,N-bis(carboxymethyl)glycinato(3-)-N,O,O']-, hydrogen, (T-4)-	53108-50-2	Intentional addition / 1,000ppm	chemical products
12441	Plumbate(1-), [N,N-bis(carboxymethyl)glycinato(3-)-N,O,O']-, sodium, (T-4)-	53113-58-9	Intentional addition / 1,000ppm	chemical products
12442	Antimony phosphate	53120-23-3	Intentional addition / 1,000ppm	chemical products
12443	Dibismuth zirconium pentaoxide	53125-66-9	Contains (regardless of intentional or impurities)	chemical products
12444	Stannate(2-), tetrachloro-, diammonium, (T-4)-	53149-60-3	Intentional addition / 1,000ppm	chemical products
12445	3-Octene, 1-bromo-, (E)-	53155-10-5	Intentional addition / 1,000ppm	chemical products
12446	3-Octene, 1-bromo-, (Z)-	53155-11-6	Intentional addition / 1,000ppm	chemical products
12447	Copper fluoride oxide	53156-93-7	Contains (regardless of intentional or impurities)	chemical products
12448	Cerium tin oxide (CeSnO4)	53169-23-6	Contains (regardless of intentional or impurities)	chemical products
12449	Cerium zirconium oxide (CeZrO4)	53169-24-7	Contains (regardless of intentional or impurities)	chemical products
12450	Barium ethyl acetoacetate	53187-11-4	Intentional addition	chemical products
12451	Nickel(1+), [1-(2-amino-4-imino-5(4H)-thiazolidene)-N-[1-(2-amino-4-imino-5(4H)-thiazolidene)-1H-isindol-3-yl]-1H-isindol-3-aminato]-, chloride	53199-85-2	Contains (regardless of intentional or impurities)	chemical products
12452	10-Oxa-4,6-dithia-5-stannahexadecanoic acid, 5,5-dibutyl-12-ethyl-9-oxo-, 2-ethylhexyl ester	53202-61-2	Contains (regardless of intentional or impurities)	chemical products
12453	Chromic acid (H2CrO4), pracedodymium(3+) salt (3:2)	53206-40-9	Intentional addition / 1,000ppm	chemical products
12454	Chromic acid (H2CrO4), pracedodymium(3+) salt (3:2), heptahydrate	53206-41-0	Intentional addition / 1,000ppm	chemical products
12455	4-Nitrobenzene-1,2-diamine monohydrochloride	53209-19-1	Contains (regardless of intentional or impurities)	chemical products
12456	Cuprate(2-), tetrachloro-, (T-4)-, dihydrogen, compound with (S)-3-(1-methyl-2-pyrrolidiny)pyridine (1:1)	53224-08-1	Contains (regardless of intentional or impurities)	chemical products
12457	Platinum(II) sulfate	53231-79-1	Contains (regardless of intentional or impurities)	chemical products
12458	Butyltris(3-isooctylthio)-1-oxopropoxy]stannane	53236-83-2	Contains (regardless of intentional or impurities)	chemical products
12459	4-Dansylaminophenylmercuric acetate	53282-60-3	Contains (regardless of intentional or impurities)	chemical products
12460	Cuprate(2-), bis[[4-methylpentylamino]sulfonyl]-29H,31H-phthalocyaninedisulfonato(4-)-N29,N30,N31,N32]-, dihydrogen, compound with 4-methyl-1-pentanamine (1:2)	53289-89-7	Intentional addition / 1,000ppm	chemical products
12461	Chromate(3-), bis[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, trihydrogen	53295-04-8	Contains (regardless of intentional or impurities)	chemical products
12462	Benzo[a]phenoxazin-7-ium, 5-amino-9-(diethylamino)-, perchlorate	53340-16-2	Intentional addition / 1,000ppm	chemical products
12463	1,2-Benzenedimethanamine, N,N,N',N'-tetramethyl-, monoperoxalate	53369-81-6	Intentional addition / 1,000ppm	chemical products
12464	Cyclohexanol, 5-methyl-2-(1-methylethyl)-, monoester with boric acid (H3BO3), (1.alpha.,2.beta.,5.alpha.)-	53370-45-9	Intentional addition / 1%	chemical products
12465	Copper dehydroabietyl ammonium 2-ethylhexanoate	53404-24-3	Intentional addition / 1,000ppm	chemical products
12466	Dodecylammonium methanearsonate	53404-47-0	Contains (regardless of intentional or impurities)	chemical products
12467	Manganous benzothiazylmercaptide	53404-58-3	Contains (regardless of intentional or impurities)	chemical products
12468	Phenylmercuric ammonium acetate	53404-67-4	Contains (regardless of intentional or impurities)	chemical products
12469	Phenylmercuric ammonium propionate	53404-68-5	Contains (regardless of intentional or impurities)	chemical products
12470	Phenylmercuric carbonate	53404-69-6	Contains (regardless of intentional or impurities)	chemical products
12471	Phenylmercuric monoethanol ammonium lactate	53404-70-9	Contains (regardless of intentional or impurities)	chemical products
12472	Isopropyl 4-oxo-4-[[tributylstannyl]oxy]butyrate	53404-82-3	Contains (regardless of intentional or impurities)	chemical products
12473	(2-Hydroxyethyl)diethylammonium (2,4,5-trichlorophenoxy)acetate	53404-86-7	Intentional addition / 1,000ppm	chemical products
12474	Methanesulfonic acid, tin(2+) salt	53408-94-9	Contains (regardless of intentional or impurities)	chemical products
12475	Copper oxalate	53421-36-6	Intentional addition / 1,000ppm	chemical products
12476	Triphenyl(p,p,p-triphenylphosphine imidato-N)phosphorus(1+) tetracarboxylcobaltate(1-)	53433-12-8	Intentional addition / 1,000ppm	chemical products
12477	1-Heptene, 1-bromo-, (E)-	53434-74-5	Intentional addition / 1,000ppm	chemical products
12478	Tributyltin monopropylene glycol maleate	53466-85-6	Contains (regardless of intentional or impurities)	chemical products
12479	18,18'-[[Dibutylstannylene]bis(oxo)]bis[18-oxooctadecan-7-ol]	53478-57-2	Contains (regardless of intentional or impurities)	chemical products
12480	[R-(Z)]-18-Oxo-18-[[tributylstannyl]oxy]octadec-9-en-7-ol	53478-61-8	Contains (regardless of intentional or impurities)	chemical products
12481	Acetic acid, sec-pentyl ester	53496-15-4	Contains (regardless of intentional or impurities)	chemical products
12482	(T-4)-Calcium tetrafluoroberyllate	53514-39-9	Intentional addition / 1,000ppm	chemical products
12483	6-Bromo-2,2-dimethylhexanenitrile	53545-96-3	Intentional addition	chemical products
12484	1,2,3,8-Tetrachlorodibenzo-p-dioxin	53555-02-5	Intentional addition / 1,000ppm	chemical products
12485	[N,N,N',N',N'-Hexamethyl-29H,31H-phthalocyaninetrimethylaminato(2-)-N29,N30,N31,N32]copper	53555-23-0	Intentional addition / 1,000ppm	chemical products
12486	Pyriminil	53558-25-1	Contains (regardless of intentional or impurities)	chemical products
12487	Dibutylaldehyde O,O'-[1,1,3,3-tetrabutyl-1,3-distannoxanediyl]dioxime	53584-15-9	Contains (regardless of intentional or impurities)	chemical products
12488	Dibenzylbenzene, ar-methyl derivative	53585-53-8	Intentional addition / 1%	chemical products
12489	Orthoboric acid, compound with 1,3,5-triazine-2,4,6-triamine	53587-44-3	Intentional addition / 1%	chemical products
12490	Tetrapotassium zirconium tetrakis(sulphate)	53608-79-0	Contains (regardless of intentional or impurities)	chemical products
12491	4-Amino-4-methyl-2-pentanone oxalate	53608-87-0	Intentional addition	chemical products
12492	2-Octene, 1-bromo-, (Z)-	53645-21-9	Intentional addition / 1,000ppm	chemical products
12493	Barium silicon oxide (BaSi4O9)	53652-94-1	Intentional addition / 1,000ppm	chemical products

(Appendix table 1) MISUMI Specified Chemical Substances

Ver.2.0.0 date of revision 5/31/2022 Misumi Corporation

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
12494	Benzothiazolium, 5-chloro-2-[2-[3-[[5-chloro-3-ethyl-2(3H)-benzothiazolylidene]ethylidene]-2-(diphenylamino)-1-cyclopenten-1-yl]ethenyl]-perchlorate	53655-17-7	Intentional addition / 1,000ppm	chemical products
12495	Trisodium 4-[[O-arsonophenyl]azo]-3-oxidonaphthalene-2,7-disulphonate	53669-45-7	Contains (regardless of intentional or impurities)	chemical products
12496	Beryllium potassium sulfate	53684-48-3	Contains (regardless of intentional or impurities)	chemical products
12497	Dicalcium iron(2+) bis[2-hydroxypropane-1,2,3-tricarboxylate]	53684-61-0	Intentional addition / 1%	chemical products
12498	Propane, 2,3-dibromo-1,1,1,2,3-pentafluoro-, (R*,R*)-	53692-41-4	Intentional addition / 1,000ppm	chemical products
12499	Propane, 2,3-dibromo-1,1,1,2,3-pentafluoro-, (R*,S*)-	53692-42-5	Intentional addition / 1,000ppm	chemical products
12500	Propane, 3-bromo-1,1,1,2,3-pentafluoro-, (R*,S*)-	53692-43-6	Intentional addition / 100ppm	chemical products
12501	Propane, 3-bromo-1,1,1,2,3-pentafluoro-, (R*,R*)-	53692-44-7	Intentional addition / 100ppm	chemical products
12502	Copper(2+) methacrylate	53721-10-1	Intentional addition / 1,000ppm	chemical products
12503	Diphosphoric acid manganese(4+) salt (1:1)	53721-35-4	Contains (regardless of intentional or impurities)	chemical products
12504	Tris[heptane-3,5-dionato-O,O']chromium	53749-20-5	Intentional addition / 1,000ppm	chemical products
12505	Arsenic selenide (As <sub>3</sub> Se <sub>2</sub> )	53800-83-2	Intentional addition / 1,000ppm	chemical products
12506	Zirconium oxide	53801-45-9	Contains (regardless of intentional or impurities)	chemical products
12507	Zinc copper couple	53801-63-1	Intentional addition / 1,000ppm	chemical products
12508	Bismuth vanadium oxide	53801-77-7	Intentional addition / 1%	chemical products
12509	Zinc zirconium oxide	53807-65-1	Contains (regardless of intentional or impurities)	chemical products
12510	Pentlandite	53809-86-2	Contains (regardless of intentional or impurities)	chemical products
12511	1-Amino-4-nitroanthraquinone-2-carboxylic acid cyclohexyl	53814-79-2	Contains (regardless of intentional or impurities)	chemical products
12512	Fructose 1-(barium phosphate)	53823-70-4	Contains (regardless of intentional or impurities)	chemical products
12513	Barium hydrogen 3-hydroxy-2-(phosphonatoxy)propionate	53823-72-6	Contains (regardless of intentional or impurities)	chemical products
12514	1,3,5-Triazine-2,4,6-(1H,3H,5H)-trione, cadmium salt (2:1)	53846-34-7	Contains (regardless of intentional or impurities)	chemical products
12515	Butanoic acid, antimony (3+) salt	53856-17-0	Contains (regardless of intentional or impurities)	chemical products
12516	(Dinonylnaphthalene-1-sulphonato-O)hydroxybarium	53887-44-8	Contains (regardless of intentional or impurities)	chemical products
12517	Blasticidin S, carbamodithioate, (S)-isomer	53890-98-5	Intentional addition / 1%	chemical products
12518	Magnesium bis(phenylamide)	53894-37-4	Contains (regardless of intentional or impurities)	chemical products
12519	Cobaltate(1-), [N,N-bis(carboxymethyl)glycinate(3-)-N,O,O']-, sodium, monohydrate, (T-4)-	53927-86-9	Intentional addition / 1%	chemical products
12520	Hydroxylammonium 4-methylbenzenesulphonate	53933-48-5	Contains (regardless of intentional or impurities)	chemical products
12521	Benzediazonium, 3-chloro-4-(1-pyrrolyl)-, tetrafluoroborate(1-)	53934-41-1	Intentional addition / 1%	chemical products
12522	2-Phenyl glycinonitrile hydrochloride	53941-45-0	Intentional addition	chemical products
12523	Acetamide, N-2-[(2-bromo-4,6-dinitrophenyl)azo]-5-[[2-(cyanoethyl)amino]-4-methoxyphenyl]-	53950-33-7	Contains (regardless of intentional or impurities)	chemical products
12524	Cerium molybdenum oxide	53986-44-0	Intentional addition / 1%	chemical products
12525	2H-Benzimidazole-2-thione, 1,3-dihydro-4(or 5)-methyl-	53988-10-6	Intentional addition / 1,000ppm	chemical products
12526	Manganese, [[1,2-ethanedilybis(carbamodithioato)](2)-], mixture with [[1,2-ethanedilybis(carbamodithioato)](2)-]copper	53988-93-5	Contains (regardless of intentional or impurities)	chemical products
12527	Borate(1-), bis[1,2-benzenediolato(2-)-O,O']-, (T-4)-, hydrogen, compound with N-methylmethanamine (1:1)	53992-90-8	Intentional addition / 1%	chemical products
12528	Borate(1-), bis[1,2-benzenediolato(2-)-O,O']-, (T-4)-, hydrogen, compound with N-(1-methylethyl)-2-propanamine (1:1)	53992-91-9	Intentional addition / 1%	chemical products
12529	Tin, diocetylbis(2,4-pentanedionato-kappa O2, kappa O4)-	54068-28-9	Intentional addition / 1,000ppm	chemical products
12530	Oxonium, trimethyl-, (OC-6-11)-hexachloroantimonate(1-)	54075-76-2	Contains (regardless of intentional or impurities)	chemical products
12531	Disperse Yellow 56	54077-16-6	Intentional addition / 1,000ppm	chemical products
12532	Disodium 4-[[4,5-dihydro-4-[[2-hydroxy-5-[[2-(sulphooxy)ethyl]sulphonyl]phenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulphonato(4-)]cuprate(2-)	54227-68-8	Intentional addition / 1,000ppm	chemical products
12533	Tin(4+) 2-(isooctylxy)-2-oxoethane-1-thiolate	54235-66-4	Contains (regardless of intentional or impurities)	chemical products
12534	Barium tetrabromophthalate	54241-05-3	Intentional addition / 1,000ppm	chemical products
12535	Methanesulfonic acid, copper(2+) salt	54253-62-2	Contains (regardless of intentional or impurities)	chemical products
12536	3-Bromo-4-oxopentanoic acid, (±)-, ethyl ester	54260-84-3	Contains (regardless of intentional or impurities)	chemical products
12537	1-Propene, 3,3,3-trifluoro-2-(trifluoromethyl)-, polymer with ethene and tetrafluoroethene	54302-05-5	Intentional addition / 1,000ppm	chemical products
12538	Hexane, 2,3-dichloro-	54305-87-2	Intentional addition / 1,000ppm	chemical products
12539	Disodium 8-[[5-chloro-2-hydroxyphenyl]azo]-7-hydroxynaphthalene-1,3-disulphonato(4-)]hydroxychromate(2-)	54306-63-7	Contains (regardless of intentional or impurities)	chemical products
12540	Amidothioate	54381-26-9	Intentional addition / 1%	chemical products
12541	Strychnidin-10-one, sulfate (2:1), compound with (OC-6-11)-tris(1,10-phenanthroline-N1,N10)zinc(2+) sulfate (1:1:1)	54387-02-9	Contains (regardless of intentional or impurities)	chemical products
12542	1,1'-(6-Oxido-1,3,5-triazine-2,4-diylo)bis(1-methylpiperidinium) tetrafluoroborate(1-)	54388-43-1	Intentional addition / 1%	chemical products
12543	Zinc dihydrogen diphosphate	54389-17-2	Intentional addition / 25%	chemical products
12544	Copper boride	54427-07-5	Intentional addition / 1,000ppm	chemical products
12545	Copper iron zinc oxide	54427-17-7	Intentional addition / 1,000ppm	chemical products
12546	Adipic acid, cobalt salt	54437-56-8	Intentional addition / 1,000ppm	chemical products
12547	Cuprate(4-), [4-hydroxy-7-[[4-[[2-hydroxyethyl]amino]-6-[[5-(hydroxy-kappa O)-6-[[2-(hydroxy-kappa O)-5-sulphophenyl]diazenyl]-kappa N1]]-7-sulfo-2-naphthalenyl]amino]-1,3,5-triazin-2-yl]amino]-3-[2-[4-methoxy-2-sulphophenyl]diazenyl]-2-naphthalenesulfonato(6-)]-, hydrogen (1:4)	54446-14-9	Intentional addition / 1,000ppm	chemical products
12548	Cuprate(2-), [[N,N-1,2-ethanedilybis(N-(carboxymethyl)glycinate)](4-)-N,N',O,O',ON,ON']-, dihydrogen, (OC-6-21)-	54453-03-1	Intentional addition / 1,000ppm	chemical products
12549	Aniline, 2-(acetoxymercurio)-4-nitro-	54481-45-7	Contains (regardless of intentional or impurities)	chemical products
12550	Pentane, 1-bromo-5-chloro-	54512-75-3	Intentional addition / 1,000ppm	chemical products
12551	2,2-Dichloro-5-nitrobenzophenone	54534-72-4	Contains (regardless of intentional or impurities)	chemical products
12552	1,2,3-Trichlorodibenzo(b,e)(1,4)dioxin	54536-17-3	Intentional addition / 1,000ppm	chemical products
12553	1,2-Dichlorodibenzo(b,e)[1,4]dioxin	54536-18-4	Intentional addition / 1,000ppm	chemical products
12554	1,4-Dichlorodibenzo(b,e)[1,4]dioxin	54536-19-5	Intentional addition / 1,000ppm	chemical products
12555	1-(4-Chlorobutyl)-4-fluorobenzene	54540-58-8	Intentional addition / 1,000ppm	chemical products
12556	L-Cerebronic acid, strychnine salt	54563-88-1	Contains (regardless of intentional or impurities)	chemical products
12557	Borate(1-), hydrotris(1-methylpropyl)-, potassium, (T-4)-	54575-49-4	Intentional addition / 1%	chemical products
12558	Antimony nickel titanium oxide	54576-53-3	Contains (regardless of intentional or impurities)	chemical products
12559	C.I. Direct Orange 1	54579-28-1	Intentional addition / 100ppm	chemical products
12560	Dibutylbis(ethyl 3-oxobutyrato-O',O3)tin	54581-65-6	Contains (regardless of intentional or impurities)	chemical products
12561	3-Amidinothio-2-chloropropionic acid methyl	54588-77-5	Contains (regardless of intentional or impurities)	chemical products
12562	Poly(oxy-1,2-ethanediylo), alpha-(3-carboxy-1-oxosulfo)propyl-, omega-(nonylphenoxy)-	54612-36-1	Intentional addition / 1,000ppm	chemical products
12563	Perboric acid (HBO(O2)), calcium salt	54630-47-6	Intentional addition / 1%	chemical products
12564	Boric acid, compound with 1,3,5-triazine-2,4,6-triamine	54649-97-7	Intentional addition / 1%	chemical products
12565	Nicotine hydrogen (±) tartrate	54661-91-5	Contains (regardless of intentional or impurities)	chemical products
12566	Pentane, 2,2,3-trimethyl-, (R)-	54665-47-3	Intentional addition / 1%	chemical products
12567	Strychnidin-10-one, mono(S)-alpha-methylbenzeneacetate]	54667-63-9	Contains (regardless of intentional or impurities)	chemical products
12568	alpha-Cyano-m-hydroxycinnamic acid	54673-07-3	Intentional addition	chemical products
12569	Manganese abietate	54675-76-2	Contains (regardless of intentional or impurities)	chemical products
12570	Bromo[thiobis(methane)]copper	54678-23-8	Intentional addition / 1,000ppm	chemical products
12571	Hexahydro-1H-azepine-1-acetonitrile	54714-50-0	Intentional addition	chemical products
12572	Dibarium discandium pentaoxide	54723-39-6	Contains (regardless of intentional or impurities)	chemical products
12573	4-(6-Amino-1,4-dihydro-4-oxo-1,3,5-triazin-2-yl)-4-methylmorpholinium tetrafluoroborate	54761-91-0	Intentional addition / 1%	chemical products
12574	Antimonate(1-), hexafluoro-, hydrogen-d, (OC-6-11)-	54764-32-8	Contains (regardless of intentional or impurities)	chemical products
12575	(+)-cis-Permethrin	54774-45-7	Intentional addition / 1%	chemical products
12576	(-)-cis-Permethrin	54774-46-8	Intentional addition / 1%	chemical products
12577	(-)-trans-Permethrin	54774-47-9	Intentional addition / 1%	chemical products
12578	5-Amino-6-cyanopyrazin-2-yl acetate	54798-28-6	Intentional addition	chemical products
12579	Benzeneamine, 4-methyl-N-propyl-	54837-90-0	Intentional addition / 25%	chemical products
12580	Acetic acid, bromo-, cobalt(2+) salt	54846-43-4	Intentional addition / 1,000ppm	chemical products
12581	Antimony silicate	54847-25-5	Contains (regardless of intentional or impurities)	chemical products
12582	Acetic acid, 2,2,2'-[[methylstannylidene]tris(thio)]tris-, triisooctyl ester	54849-38-6	Contains (regardless of intentional or impurities)	chemical products
12583	Anthyllium, 9-[2-(ethoxycarbonyl)phenyl]-3,6-bis(ethylamino)-2,7-dimethyl-, tetrafluoroborate(1-)	54854-14-7	Intentional addition / 1%	chemical products
12584	1-Propanaminium, N-(2-hydroxyethyl)-N-methyl-3-[[1-(oxooctadecyl)amino]-N-[3-[[1-(oxooctadecyl)amino]propyl]-perchlorate (salt)]	54952-46-4	Intentional addition / 1,000ppm	chemical products
12585	Ferrate(1-), [[N,N-1,2-ethanedilybis(N-(carboxymethyl)glycinate)](4-)-N,N',O,O',ON,ON']-, potassium, (OC-6-21)-	54959-35-2	Intentional addition / 1%	chemical products
12586	Molybdate (MoO54-), barium (1:2), (TB-5-11)-	54983-00-5	Intentional addition / 1,000ppm	chemical products
12587	Barium dilactate	54983-89-0	Contains (regardless of intentional or impurities)	chemical products
12588	Aluminum chromium oxide	54991-58-1	Contains (regardless of intentional or impurities)	chemical products
12589	Chromate(2-), [N-7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl]acetamidato(2-)](2)-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, disodium	55039-14-0	Contains (regardless of intentional or impurities)	chemical products
12590	Cyanamide, (1,4,5,6-tetrahydro-4,6-dioxo-2-pyrimidinyl)-	55067-10-2	Intentional addition	chemical products
12591	Cupric zinc sulfate complex, basic	55072-57-6	Intentional addition / 1,000ppm	chemical products
12592	1,3,2-Dioxaborinane, 2,2'-oxybis[5,5-dimethyl-]	55089-03-7	Intentional addition / 1%	chemical products
12593	Tin fluorides (F <sub>2</sub> Sn)	55128-73-9	Contains (regardless of intentional or impurities)	chemical products
12594	Narasin	55134-13-9	Intentional addition	chemical products
12595	Hexadecaaluminum barium dimagnesium heptacosaoxide	55134-50-4	Contains (regardless of intentional or impurities)	chemical products
12596	Barium maleate (1:2)	55135-58-5	Contains (regardless of intentional or impurities)	chemical products
12597	Methanesulfonic acid, chromium(3+) salt	55136-34-0	Contains (regardless of intentional or impurities)	chemical products
12598	Pent-2'-ynal	55136-52-2	Contains (regardless of intentional or impurities)	chemical products
12599	Iron(III) perchlorate hexahydrate	55144-08-6	Intentional addition / 1,000ppm	chemical products
12600	Chromium(3+) perchlorate	55147-94-9	Intentional addition / 1,000ppm	chemical products
12601	Beryllium-copper-cobalt alloy	55158-44-6	Contains (regardless of intentional or impurities)	chemical products
12602	1,1,1-Dibromo-2-chloropropane	55162-35-1	Intentional addition / 1,000ppm	chemical products
12603	Neodecanoic acid, barium salt	55172-98-0	Contains (regardless of intentional or impurities)	chemical products
12604	Copper hydroxide sulfate	55200-89-0	Intentional addition / 1,000ppm	chemical products
12605	alpha-tert-Butyl-beta-(4-chlorophenoxy)-1H-1,2,4-triazole-1-ethanol	55219-65-3	Contains (regardless of intentional or impurities)	chemical products
12606	3,5,8,8-Tetrathia-4,7-distanadecanedioic acid, 4,7-bis[[2-(isooctylxy)-2-oxoethyl]thio]-4,7-dimethyl-, diisooctyl ester	55230-73-4	Intentional addition / 1,000ppm	chemical products
12607	4,8,7,9-Tetrathia-5,8-distanadecanedioic acid, 4,8-bis[[3-(isooctylxy)-3-oxopropyl]thio]-4,8-dimethyl-, diisooctyl ester	55230-77-8	Intentional addition / 1,000ppm	chemical products
12608	Tetramethyltetraselenavalbene	55259-49-9	Contains (regardless of intentional or impurities)	chemical products
12609	Carbosulfan	55265-14-8	Contains (regardless of intentional or impurities)	chemical products
12610	Indium hydroxide	55326-87-9	Intentional addition / 1%	chemical products
12611	[[O,3,6-Trichloropyridin-2-yl]oxy]acetic acid	55335-06-3	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
12612	Vanadate (V2O74-), tetracesium	55343-67-4	Intentional addition / 1%	chemical products
12613	Propanoic acid, 3,3'-[[1,1,3,3-tetrabutyl-1,3-dioxanediyl]bis(thio)]bis-, diisooctyl ester	55348-64-6	Intentional addition / 1,000ppm	chemical products
12614	Chromium copper iron oxide (Cr2CuFe2O7)	55353-02-1	Intentional addition / 1,000ppm	chemical products
12615	Chromic acid, manganese salt	55392-76-2	Contains (regardless of intentional or impurities)	chemical products
12616	Tetrabutylammonium bis(maleonitriledithiolato)nickel(III) complex	55401-12-2	Contains (regardless of intentional or impurities)	chemical products
12617	3-Iodo-2-propynyl butylcarbamate	55406-53-6	Contains (regardless of intentional or impurities)	chemical products
12618	Tributyl(pentane-2,4-dionato-O,O')tin	55410-80-5	Contains (regardless of intentional or impurities)	chemical products
12619	Benzoselenazolium, 3-(3-sulfopropyl)-2-[[3-(3-sulfopropyl)-2(3H)-benzoselenazolylidene]methyl]-, inner salt, sodium salt	55425-27-9	Contains (regardless of intentional or impurities)	chemical products
12620	Rhodium, trichlorotris[1,1'-thiobis]butane]]	55425-73-5	Contains (regardless of intentional or impurities)	chemical products
12621	Sodium trichloroacetate	55425-74-6	Intentional addition / 1,000ppm	chemical products
12622	Dihydrogen [[N,N'-ethylenbis[N-(carboxymethyl)glycinate]](4)-N,N,O,O',ON,ON']manganate(2-)	55448-20-9	Contains (regardless of intentional or impurities)	chemical products
12623	Cobaltate(1-), [[N,N'-1,2-ethanediybis[N-(carboxymethyl)glycinate]](4)-N,N,O,O',ON,ON]-, hydrogen, (OC-6-21)-	55448-22-1	Intentional addition / 1%	chemical products
12624	1,3-Isobenzofurandione, 3a,4,7,7a-tetrahydro-4-methyl-, [3aR-(3a.alpha.,4.beta.,7a.alpha.)]-	55449-34-8	Intentional addition / 1%	chemical products
12625	Nickel antimonate	55467-74-8	Contains (regardless of intentional or impurities)	chemical products
12626	Dimethyl 3,4,5,6-tetrabromophthalate	55481-60-2	Intentional addition / 900ppm	chemical products
12627	2-Naphthalenesulfonic acid, 8-hydroxy-5,7-dinitro-, barium salt (1:1)	55482-31-0	Contains (regardless of intentional or impurities)	chemical products
12628	2-Propanoic acid, iron(3+) salt	55488-18-1	Intentional addition / 1%	chemical products
12629	Ethanedioic acid, ammonium iron salt (1:?:?)	55488-87-4	Intentional addition / 1,000ppm	chemical products
12630	Phenol, 2,2'-methylenebis-, polymer with (chloromethyl)oxirane	55492-52-9	Intentional addition / 1%	chemical products
12631	Cobalt(3+), hexaamine-, (OC-6-11)-, phosphate (1:1)	55494-92-3	Intentional addition / 1,000ppm	chemical products
12632	(OC-6-11)-Hexaaminecobalt phosphate tetrahydrate	55494-93-4	Intentional addition / 1%	chemical products
12633	Boric acid, B-(3,4-dimethylphenyl)-	55499-43-9	Intentional addition / 1%	chemical products
12634	2,4-Dimethylbenzeneboric acid	55499-44-0	Intentional addition / 1%	chemical products
12635	Choric acid barium	55508-12-8	Intentional addition	chemical products
12636	Furan-3-boronic acid	55552-70-0	Intentional addition / 1%	chemical products
12637	Phosphonium, tetrakis(hydroxymethyl)-, sulfate (2:1) (salt)	55566-30-8	Intentional addition / 1,000ppm	chemical products
12638	Benzoic acid, 2,2'-[[dibutylstannylene]bis(oxy-carbonyl)]bis-, didodecyl ester	55568-37-1	Intentional addition / 1,000ppm	chemical products
12639	Acetarsol sodium	55588-51-7	Contains (regardless of intentional or impurities)	chemical products
12640	Chromate(3-), bis[4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, trihydrogen	55613-78-0	Contains (regardless of intentional or impurities)	chemical products
12641	Diammonium carbonate mixture with copper(2+) sulfate (1:1)	55632-67-2	Intentional addition / 1,000ppm	chemical products
12642	(2-Hydroxy-2-methylpropyl)ferrocene	55648-90-3	Intentional addition / 1%	chemical products
12643	Chromate(3-), bis[5-[[5-chloro-2-hydroxyphenyl]azo]-6-hydroxy-2-naphthalenesulfonato(3-)]-, trihydrogen	55657-54-0	Contains (regardless of intentional or impurities)	chemical products
12644	Strychnidin-10-one, mixture with 3,7-dihydro-1,3,7-trimethyl-1H-purine-2,6-dione, (1.alpha.,2.alpha.,3.beta.,6.beta.,8a.beta.,8b.beta.,9R*)-hexahydro-2a-hydroxy-9-(1-hydroxy-1-methylethyl)-8b-methyl-3,6-methano-8H-1,5,7-trioxacyclopenta[aj] cyclop[aj]azulene-4,8(3H)-dione, (1.alpha.,2.alpha.,3.beta.,6.beta.,8a.beta.,8b.beta.,9R*)-hexahydro-2a-hydroxy-8b-methyl-9-(1-methylethyl)-3,6-methano-8H-1,5,7-trioxacyclopenta[aj] cyclop[aj]azulene-4,8(3H)-dione and 6,7,8,9-tetrahydro-5H-tetrazolo[1,5-a]azepine	55659-55-7	Contains (regardless of intentional or impurities)	chemical products
12645	4-Octene, 3-bromo-	55668-21-8	Intentional addition / 1,000ppm	chemical products
12646	Cobaltate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen	55668-56-9	Intentional addition / 1,000ppm	chemical products
12647	Copper, [ethanedioato(2-)-O,O']-, hydrate (2:1)	55671-32-4	Intentional addition / 1,000ppm	chemical products
12648	1,2,3,4,7,8,9-Heptachlorodibenzofuran	55673-89-7	Contains (regardless of intentional or impurities)	chemical products
12649	Cyclohexanecarboxylic acid, cadmium salt	55700-14-6	Contains (regardless of intentional or impurities)	chemical products
12650	1H-Tetrazole, 5-phenyl-, barium salt	55719-88-5	Contains (regardless of intentional or impurities)	chemical products
12651	Phenyl ether, hexachloro derivative	55720-99-5	Intentional addition / 1%	chemical products
12652	Tritaluminum diglycol trityrtrim dodecaoxide	55763-23-0	Intentional addition / 1%	chemical products
12653	Nicotinic compound with methyl orange (1:1)	55774-24-8	Contains (regardless of intentional or impurities)	chemical products
12654	Calcium [orthosilicato(4-)-O]oxazirconate(2-)	55799-19-4	Contains (regardless of intentional or impurities)	chemical products
12655	Chromate(3-), bis[3-[[4,5-dihydro-5-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, trisodium	55809-98-8	Contains (regardless of intentional or impurities)	chemical products
12656	5-Ethoxy-2-[[2-[[3-ethyl-5-methyl-3H-benzoselenazol-2-ylidene]methyl]but-1-enyl]-3-(3-sulphonatopropyl)benzothiazolium	55811-25-1	Contains (regardless of intentional or impurities)	chemical products
12657	Meprotil	55814-41-0	Intentional addition / 1%	chemical products
12658	1-Acetyl-(cyanoacetyl)hydrazine	55819-76-6	Intentional addition	chemical products
12659	4(3H)-Quinazoline, 7-bromo-6-chloro-3-(3-(3-hydroxy-2-piperidinyl)-2-oxopropyl)-, trans-(±)	55837-20-2	Intentional addition	chemical products
12660	Trisodium yttrium bis(phosphate)	55859-81-9	Intentional addition / 1%	chemical products
12661	Benzenesulfonyl chloride, 3,5-bis(1,1-dimethylethyl)-4-hydroxy-, nickel(2+) salt (2:1)	55868-93-4	Contains (regardless of intentional or impurities)	chemical products
12662	Sodium bis[methyl(8-[[5-(ethylsulphonyl)-2-hydroxyphenyl]azo]-7-hydroxy-2-naphthyl)methyl]carbamato(2-)]cobaltate(1-)	55870-93-4	Intentional addition / 1,000ppm	chemical products
12663	Sodium bis[1-[[5-(ethylsulphonyl)-2-hydroxyphenyl]azo]-2-naphtholato(2-)]cobaltate(1-)	55870-94-5	Intentional addition / 1,000ppm	chemical products
12664	Hexakis(dimethylamino)-mu-oxodiphosphorus(2+) bis(tetrafluoroborate(1-))	55881-03-3	Intentional addition / 1%	chemical products
12665	Tetrachlorobis[1,1'-thiobis(ethane)]platinum	55903-50-9	Contains (regardless of intentional or impurities)	chemical products
12666	Chromium, tris(2-hydroxybenzoato-O1,O2)-	55917-86-7	Intentional addition / 1,000ppm	chemical products
12667	Bis(ethylcyclopentadienyl)vanadium(II)	55940-04-0	Intentional addition / 1%	chemical products
12668	Glutathione copper salt	55945-96-5	Intentional addition / 1,000ppm	chemical products
12669	Ethane, chloro-1,1-difluoro-	55949-44-5	Intentional addition / 1,000ppm	chemical products
12670	Butane, nonafluoro-	55949-54-7	Intentional addition / 1,000ppm	chemical products
12671	Cobaltate(1-), bis[N-(2-chlorophenyl)-2-[[2-hydroxy-5-[(methylamino)sulfonyl]phenyl]phenyl]azo]-3-oxobutanamido(2-)]-, hydrogen	55963-70-7	Intentional addition / 100ppm	chemical products
12672	5-Chloro-2-methyl-3(2H)-isothiazolone, mixture with 2-methyl-3(2H)-isothiazolone	55965-84-9	Contains (regardless of intentional or impurities)	chemical products
12673	P-Phenylenediamine hydrochloride	55972-71-9	Intentional addition / 1,000ppm	chemical products
12674	Zincate(2-), tetrachloro-, (T-4)-, dihydrogen, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	55980-77-7	Contains (regardless of intentional or impurities)	chemical products
12675	Tris(lauroyloxy)octylstannane	56046-99-2	Contains (regardless of intentional or impurities)	chemical products
12676	1,1-Bis(methylseleno)ethane	56051-04-8	Contains (regardless of intentional or impurities)	chemical products
12677	1,1-Bis(methylselenyl)cyclohexane	56051-08-2	Contains (regardless of intentional or impurities)	chemical products
12678	Cobalt, [[1,2-ethanediybis(carbamodithioato)](2-)]-, mixture with N,N'-bis(2-aminoethyl)-1,2-ethanediamine and [[1,2-ethanediybis(carbamodithioato)](2-)]zinc	56060-88-9	Intentional addition / 1%	chemical products
12679	Difenacum	56073-07-5	Contains (regardless of intentional or impurities)	chemical products
12680	Brodifacum	56073-10-0	Contains (regardless of intentional or impurities)	chemical products
12681	Selenium sulfide	56093-45-9	Contains (regardless of intentional or impurities)	chemical products
12682	Dodecaboron diindium henicosaoxide	56094-49-6	Intentional addition / 1%	chemical products
12683	Aluminum, dibutyl-1-hexenyl-, (Z)-	56095-72-8	Intentional addition / 1,000ppm	chemical products
12684	3-(Dimethylamino)-7-(methylamino)phenothiazin-5-ium perchlorate	56109-48-9	Intentional addition / 1,000ppm	chemical products
12685	Chromate(1-), bis[4-ethylbenzenamine]tetrakis(thiocyanato-N-), (OC-6-11)-, hydrogen, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	56110-75-9	Contains (regardless of intentional or impurities)	chemical products
12686	Lanthanum boride	56127-33-4	Intentional addition / 1%	chemical products
12687	Phenol, polymer with formaldehyde, barium salt	56141-33-4	Contains (regardless of intentional or impurities)	chemical products
12688	Copper, [[N,N,N',N'-tetrakis[2-(2,5-dimethoxyphenyl)-1-methylethyl]-29H,31H-phthalocyanine-1,8,15,22-tetra-sulfonamidato(2-)]-N29,N30,N31,N32]-, (SP-4-1)-	56207-93-3	Intentional addition / 1,000ppm	chemical products
12689	1-Phenanthrenecarboxylic acid, 1,2,3,4,4a,5,6,10,10a-decahydro-1,4a-dimethyl-7-(1-methylethyl)-, molybdenum salt, [1R-(1.alpha.,4a.beta.,4b.alpha.,10a.alpha.)]-	56216-22-9	Intentional addition / 1%	chemical products
12690	Chromate(1-), [2-(3-chlorophenyl)-2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]methyl [7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl]carbamato(2-)]-, hydrogen	56237-72-0	Contains (regardless of intentional or impurities)	chemical products
12691	Trimethyl[(phenylseleno)methyl]silane	56253-60-2	Contains (regardless of intentional or impurities)	chemical products
12692	Chromium trichlorate dihydrate	56269-88-6	Intentional addition / 1,000ppm	chemical products
12693	2-Octene, 1-bromo-, (E)-	56318-83-3	Intentional addition / 1,000ppm	chemical products
12694	Arsenic disulfide	56320-22-0	Contains (regardless of intentional or impurities)	chemical products
12695	Cesium chromate	56320-90-2	Intentional addition / 1,000ppm	chemical products
12696	Bis(triphenyltin)-alpha, alpha'-dibromosuccinate	56323-19-4	Contains (regardless of intentional or impurities)	chemical products
12697	1,5-Dimethylpyrrole-2-carbonitrile	56341-36-7	Intentional addition	chemical products
12698	N,N,N',N',N'-Hexamethyl-N,N'-di(tetrafluoroboron) hexamethylenediamine	56359-96-7	Intentional addition / 1%	chemical products
12699	1,3-Dichlorohexane	56375-88-3	Intentional addition / 1,000ppm	chemical products
12700	Cuprate(3-), [2-[[[(3-amino-2-hydroxy-5-sulfonyl)azo]phenyl]methyl]azo]-5-sulfobenzoato(5-)]-, trihydrogen	56405-02-8	Intentional addition / 1,000ppm	chemical products
12701	Nickelate(1-), [[N,N'-1,2-ethanediybis[N-(carboxymethyl)glycinate]](4)-N,N,O,O',ON,ON]-, (OC-6-21)-	56408-24-3	Contains (regardless of intentional or impurities)	chemical products
12702	Zinc arsenide	56450-43-2	Contains (regardless of intentional or impurities)	chemical products
12703	Chromate(2-), [2-[[[4-hydroxy-3-[[[2-hydroxyphenyl]methylene]amino]phenyl]sulfonyl]amino]benzoato(3-)]-[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, disodium	56466-00-3	Contains (regardless of intentional or impurities)	chemical products
12704	tert-Butyl dimethyl silyl nitrile	56522-24-8	Intentional addition	chemical products
12705	Methanesulfonic acid, iron(2+) salt	56525-23-6	Intentional addition / 1%	chemical products
12706	1,1,3,3-Tetrabutyl-1,3-dioxinocycaprylate	56533-00-7	Contains (regardless of intentional or impurities)	chemical products
12707	Quinolinium dichromate	56549-24-7	Intentional addition / 1,000ppm	chemical products
12708	Sodium triacetoxborohydride	56553-60-7	Contains (regardless of intentional or impurities)	chemical products
12709	Nickel, bis[2,4-dihydro-5-methyl-4-(1-oxododecyl)-2-phenyl-3H-pyrazol-3-onato-O,O']-	56557-00-7	Contains (regardless of intentional or impurities)	chemical products
12710	Tributyltin chloride complex of ethylene oxide condensate of abietylamine	56573-85-4	Contains (regardless of intentional or impurities)	chemical products
12711	Tetrabutylammonium salt with chromic acid (2:1)	56660-19-6	Contains (regardless of intentional or impurities)	chemical products
12712	Hexanoic acid, 3,5,5-trimethyl-, chromium(3+) salt	56663-29-7	Intentional addition / 1,000ppm	chemical products
12713	Undecane, 1,1,1,3-tetrachloro-	56686-55-6	Intentional addition / 1,000ppm	chemical products
12714	Undecane, 1,1,1,3-trichloro-	56686-58-9	Intentional addition / 1,000ppm	chemical products
12715	Manganese vanadium oxide	56729-39-6	Contains (regardless of intentional or impurities)	chemical products
12716	Arsenic sulfide	56729-51-2	Contains (regardless of intentional or impurities)	chemical products
12717	1-Chloro-2,2-trifluoropropane	56758-54-4	Intentional addition / 1,000ppm	chemical products
12718	1,2-Benzenedicarbonitrile, 4-amino-	56765-79-8	Intentional addition	chemical products
12719	Sodium [N-2-bis(carboxymethyl)amino]ethyl-N-(2-hydroxyethyl)glycinate(3-)]manganate(1-)	56779-88-5	Contains (regardless of intentional or impurities)	chemical products
12720	Dicobalt hexacarbonyl tert-butyl acetylene	56792-89-9	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
12721	Zirconium, tetrakis(2-methyl-2-phenylpropyl)-	56789-10-5	Contains (regardless of intentional or impurities)	chemical products
12722	Strychnine molybdonitric acid	56789-39-8	Contains (regardless of intentional or impurities)	chemical products
12723	tert-Butylphenyl diphenyl phosphate	56803-37-3	Intentional addition / 1,000ppm	chemical products
12724	Benzoic acid, 2,2-[[dibutylstannylenebis(oxycarbonyl)]bis-, dioctyl ester	56808-12-9	Intentional addition / 1,000ppm	chemical products
12725	Chromate(2-), [4,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, disodium	56819-40-0	Contains (regardless of intentional or impurities)	chemical products
12726	2,2-Dioctyl-1,3-dioxo-6,9-dithia-2-stannacycloundecane-4,11-dione	56875-68-4	Contains (regardless of intentional or impurities)	chemical products
12727	1,3-Benzenedicarboxylic acid, 5-sulfo-, 1,3-dimethyl ester, barium salt (2:1)	56900-15-3	Intentional addition	chemical products
12728	Silicic acid, zinc zirconium salt	56902-79-5	Contains (regardless of intentional or impurities)	chemical products
12729	1-Bromo-2,3-dichlorobenzene	56961-77-4	Intentional addition / 1,000ppm	chemical products
12730	3-Bromo-2-methylpropionic acid	56970-78-6	Contains (regardless of intentional or impurities)	chemical products
12731	(R)-(-)-1,2-Ethanedithiolbis[(2-methoxyphenyl)phenylphosphine]rhodium(I) tetrafluoroborate	56977-92-5	Contains (regardless of intentional or impurities)	chemical products
12732	Cadmium divalente	56982-42-4	Contains (regardless of intentional or impurities)	chemical products
12733	Guanidine hydrochloride-hexamethylenediamine copolymer	57028-96-3	Intentional addition / 1,000ppm	chemical products
12734	Chromate(2-), [4-[[3,5-dichloro-2-hydroxyphenyl]azo]-4,5-dihydro-5-oxo-1-phenyl-1H-pyrazole-3-carboxamidato(2-)]-[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, disodium	57033-98-4	Contains (regardless of intentional or impurities)	chemical products
12735	Cuprate(1-), [3-[[3-[[4-[[[2-amino-4-hydroxyphenyl]azo]phenylamino]carbonyl]phenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonato(3-)]-, hydrogen	57036-53-0	Intentional addition / 1,000ppm	chemical products
12736	(R)-Glycidol	57044-25-4	Contains (regardless of intentional or impurities)	chemical products
12737	10-Oxa-4,6-dithia-5-stannahexadecanoic acid, 12-ethyl-5,5-dimethyl-9-oxo-, 2-ethylhexyl ester	57057-50-8	Contains (regardless of intentional or impurities)	chemical products
12738	Tris(2,5,8,11-tetraoxatridecyl) orthoborate	57057-98-4	Intentional addition / 1%	chemical products
12739	Citric acid, chromium salt	57072-40-9	Intentional addition / 1,000ppm	chemical products
12740	Butyl metaborate	57073-75-3	Intentional addition / 1%	chemical products
12741	10-Oxa-4,6-dithia-5-stannahexadecanoic acid, 12-ethyl-5-[[3-[[2-ethylhexyl]oxy]-3-oxopropyl]thio]-5-methyl-9-oxo-, 2-ethylhexyl ester	57105-89-2	Contains (regardless of intentional or impurities)	chemical products
12742	Chromate(2-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-hydroxy-N-phenylbenzenesulfonamidato(2-)]-, disodium	57108-69-7	Contains (regardless of intentional or impurities)	chemical products
12743	2,3,4,7,8-Pentachlorodibenzofuran	57117-31-4	Contains (regardless of intentional or impurities)	chemical products
12744	1,2,3,7,8-Pentachlorodibenzofuran	57117-41-6	Contains (regardless of intentional or impurities)	chemical products
12745	1,2,3,6,7,8-Hexachlorodibenzofuran	57117-44-9	Contains (regardless of intentional or impurities)	chemical products
12746	1,3-Bis(isopropyl)naphthalene	57122-16-4	Intentional addition / 1%	chemical products
12747	2,7-Naphthalenedisulfonic acid, 4-amino-3-[[4-[[[2,4-diaminophenyl]azo]phenylamino]carbonyl]phenyl]azo]-5-hydroxy-6-(phenylazo)-, disodium salt	57131-19-8	Contains (regardless of intentional or impurities)	chemical products
12748	Tribrominated polystyrene	57137-10-7	Intentional addition / 900ppm	chemical products
12749	[[2,2-[29H,31H-P]thalocyaninediylbis(methylene)]bis[1H-isoindole-1,3(2H)-dionato]](2-)-N29,N30,N31,N32)copper	57145-80-9	Intentional addition / 1,000ppm	chemical products
12750	Barium hydride	57158-15-3	Intentional addition	chemical products
12751	Aluminum zirconium chloride hydroxide	57158-29-9	Contains (regardless of intentional or impurities)	chemical products
12752	Chromate(1-), bis[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, sodium	57206-81-2	Contains (regardless of intentional or impurities)	chemical products
12753	Chromate(1-), bis[1-[[5-[[1,1-dimethylpropyl]-2-hydroxy-3-nitrophenyl]azo]-2-naphthalenolato(2-)]-, sodium	57206-83-4	Contains (regardless of intentional or impurities)	chemical products
12754	Zirconium, [mu-(carbonato(2-)-O,O')]dihydroxido]di-	57219-64-4	Contains (regardless of intentional or impurities)	chemical products
12755	Thallium iodide (TI2)	57232-83-4	Contains (regardless of intentional or impurities)	chemical products
12756	2-Heptene, 7-bromo-, (E)-	57253-23-3	Intentional addition / 1,000ppm	chemical products
12757	Dibutoxy(pentane-2,4-dionato-O,O')boron	57285-94-6	Intentional addition / 1%	chemical products
12758	Copper, [29H,31H-phthalocyanine-C,C,C,C-tetramethaniminato(2-)-N29,N30,N31,N32]-	57347-17-8	Intentional addition / 1,000ppm	chemical products
12759	Isononanoic acid, cobalt salt	57364-75-7	Intentional addition / 1,000ppm	chemical products
12760	trans-1-Heptylboronic acid	57404-76-9	Intentional addition / 1%	chemical products
12761	Tridecane, pentachloro-	57437-54-4	Intentional addition / 1,000ppm	chemical products
12762	Carbonic acid, cobalt(2+) salt (1:1), hydrate	57454-67-8	Intentional addition / 1%	chemical products
12763	Borate(1-), bis[2-hydroxybenzoato(2-)-O1,O2]-, (T-4)-, hydrogen, compound with N-methylmethanamine (1:1)	57456-63-0	Intentional addition / 1%	chemical products
12764	Benzeneselenazole, 2-methyl-5-phenyl-	57478-60-1	Intentional addition / 1,000ppm	chemical products
12765	Guanidine, N,N'-[iminodi-8,1-octanediy]bis-, triacetate	57520-17-9	Intentional addition / 3.5%	chemical products
12766	1H-Imidazole, 2-chloro-5-nitro-	57531-37-0	Contains (regardless of intentional or impurities)	chemical products
12767	Stannane, methyltris(2-ethylhexyloxy)carbonylmethylthio-	57583-34-3	Contains (regardless of intentional or impurities)	chemical products
12768	8-Oxa-3,5-dithia-4-stannatetradecanoic acid, 10-ethyl-4,4-dimethyl-7-oxo-, 2-ethylhexyl ester	57583-35-4	Contains (regardless of intentional or impurities)	chemical products
12769	Tetraphenyl m-phenylene bis(phosphate)	57583-54-7	Intentional addition / 1,000ppm	chemical products
12770	Yttrium nitrate, pentahydrate	57584-28-8	Intentional addition / 1%	chemical products
12771	3,3-Dimethoxypropionitrile	57597-62-3	Intentional addition	chemical products
12772	Cuprate(4-), [4,5-dihydro-4-[[8-hydroxy-7-[[2-hydroxy-5-methoxy-4-[[2-(sulfofuryl)ethyl]sulfonyl]phenyl]azo]-6-sulfo-2-naphthalenyl]azo]-5-oxo-1-(4-sulfofuryl)-1H-pyrazole-3-carboxylato(6-)]-, tetrahydrogen	57602-19-4	Intentional addition / 1,000ppm	chemical products
12773	Molybdate(2-), heptadecaooxtetrazincatetra-, disodium, trihydrate	57606-42-5	Contains (regardless of intentional or impurities)	chemical products
12774	Tetraammonium [mu,12-[[orthosilicato(4-)-O:O:O:O:O:O:O:O:O:O:O:O:O:O:O:O:O:O]]]tetracosaa-mu-oxododecaooxododecamolybdate(4-)	57609-48-0	Contains (regardless of intentional or impurities)	chemical products
12775	Beryllium phosphide (BeP2)	57620-29-8	Contains (regardless of intentional or impurities)	chemical products
12776	2-Azatricyclo[3.3.1.1.3.7]decan-2-oxyl	57625-08-8	Contains (regardless of intentional or impurities)	chemical products
12777	Manganese chloride (MnCl2), hexahydrate	57650-55-2	Contains (regardless of intentional or impurities)	chemical products
12778	1,2,3,6,7,8-Hexachlorodibenzo-p-dioxin	57653-85-7	Intentional addition / 1,000ppm	chemical products
12779	2-Propenoic acid, 2-methyl-, polymer with methyl 2-propenoate and 2-propenenitrile, copper(2+) salt	57655-28-4	Intentional addition / 1,000ppm	chemical products
12780	Germanium arsenide selenide	57673-50-4	Contains (regardless of intentional or impurities)	chemical products
12781	Chromate(3-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]-, trisodium	57674-14-3	Contains (regardless of intentional or impurities)	chemical products
12782	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, trisodium	57693-14-8	Contains (regardless of intentional or impurities)	chemical products
12783	Stannane, (boronoxo)tributyl-	57754-92-4	Contains (regardless of intentional or impurities)	chemical products
12784	Propylum, 1-oxo-, (OC-6-11)-hexachloroantimonate(1-)	57762-28-4	Contains (regardless of intentional or impurities)	chemical products
12785	Cuprate(3-), [4-amino-6-[[6-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-2-hydroxy-4-sulfo-1-naphthalenyl]azo]-5-hydroxy-1,3-naphthalenedisulfonato(5-)]-, trisodium	57781-96-1	Intentional addition / 1,000ppm	chemical products
12786	Tripropyltin laurate	57808-37-4	Contains (regardless of intentional or impurities)	chemical products
12787	Octanoic acid, (dimethylstannylene)bis(thio-2,1-ethanediy) ester	57813-60-2	Contains (regardless of intentional or impurities)	chemical products
12788	Octanoic acid, (methylstannylene)tris(thio-2,1-ethanediy) ester	57813-62-4	Contains (regardless of intentional or impurities)	chemical products
12789	Sulfonium, triphenyl-, (OC-6-11)-hexafluoroantimonate(1-)	57840-98-7	Contains (regardless of intentional or impurities)	chemical products
12790	1,3-Benzodithiolium tetrafluoroborate	57842-27-0	Intentional addition / 1%	chemical products
12791	1-Hexene, 1-bromo-	57855-22-8	Intentional addition / 1,000ppm	chemical products
12792	Naphthalenesulfonic acid, dinonyl-, calcium salt (2:1)	57855-22-8	Intentional addition / 100ppm	chemical products
12793	Triethyltin hydrogen sulfate	57875-77-3	Contains (regardless of intentional or impurities)	chemical products
12794	(2-Cyanopropyl)ethyl(2-ethylhexyl)sulphonium tetrafluoroborate(1-)	57875-98-6	Intentional addition / 1%	chemical products
12795	Dodecyl[3-[[2-ethylhexyl]oxy]-3-oxopropyl]sulphonium tetrafluoroborate(1-)	57878-06-9	Intentional addition / 1%	chemical products
12796	1-Ethyl-7-nitro-1,2,3,4-tetrahydroquinoline	57883-28-0	Intentional addition / 1%	chemical products
12797	2-Selenoethylguanidine	57897-99-1	Contains (regardless of intentional or impurities)	chemical products
12798	Antimony(3+) stearate	57898-46-1	Contains (regardless of intentional or impurities)	chemical products
12799	Iron(3+) (E,E)-hexa-2,4-dienoate	57898-49-4	Intentional addition / 1%	chemical products
12800	Sulfonium, triphenyl-, hexafluoroarsenate(1-)	57900-42-2	Contains (regardless of intentional or impurities)	chemical products
12801	Cyclohexene, 1-methyl-4-(1-methylthienyl)-, dimer	57912-86-4	Intentional addition / 1%	chemical products
12802	Zinc, [[1,2-ethanediy]bis(carbamodithioat)](2)-, mixture with nickel chloride (NiCl2)	57925-44-7	Contains (regardless of intentional or impurities)	chemical products
12803	Acetamide, 2-cyano-N-[[ethylamino]carbonyl]-2-(methoxymino)-	57966-95-7	Contains (regardless of intentional or impurities)	chemical products
12804	1H-Imidazole, 2-heptadecyl-, mono(tetraphenylborate)(1-)	57974-63-7	Intentional addition / 1%	chemical products
12805	4-(2,4-Dichlorobenzoyl)-1,3-dimethyl-5-pyrazolyl 4-toluenesulfonate	58011-68-0	Intentional addition / 1%	chemical products
12806	Lithium boride (LiB2)	58072-03-0	Intentional addition / 1%	chemical products
12807	3-Phenoxybenzyl (1R,3S)-3-(2,2-dichlorovinyl)-2,2-dimethylcyclopropane-1-carboxylate, labeled with carbon-14	58072-95-0	Intentional addition / 1%	chemical products
12808	3-Phenoxybenzyl (1R,3R)-3-(2,2-dichlorovinyl)-2,2-dimethylcyclopropane-1-carboxylate, labeled with carbon-14	58072-96-1	Intentional addition / 1%	chemical products
12809	Octadecanoic acid, chloro-, barium salt (2:1)	58090-82-7	Intentional addition / 1,000ppm	chemical products
12810	2-Butyl-2-[[3-[[2-butylidihydro-6-oxo-4H-1,3,2-oxathiazin-2-yl]oxy]-3-oxopropyl]thio]dihydro-9H-1,3,2-oxathiazin-6-one	58098-20-7	Contains (regardless of intentional or impurities)	chemical products
12811	Beryllium phosphide (Be3P2)	58127-61-0	Contains (regardless of intentional or impurities)	chemical products
12812	Gallium selenide (Ga2Se2)	58127-88-1	Contains (regardless of intentional or impurities)	chemical products
12813	Antimony lactate	58164-88-8	Contains (regardless of intentional or impurities)	chemical products
12814	Erbium(III) oxalate hydrate	58176-72-0	Intentional addition	chemical products
12815	Borate(1-), tetra-1H-pyrrrol-1-yl-, lithium	58179-67-2	Intentional addition / 1%	chemical products
12816	2-Propenoic acid, cobalt(2+) salt	58197-53-8	Intentional addition / 1,000ppm	chemical products
12817	1,2,3,4,6,7-Hexachlorodibenzo(b,e)(1,4)dioxin	58200-66-1	Intentional addition / 1,000ppm	chemical products
12818	1,2,3,4,6,8-Hexachlorodibenzo(b,e)(1,4)dioxin	58200-67-2	Intentional addition / 1,000ppm	chemical products
12819	1,2,3,4,6,9-Hexachlorodibenzo(b,e)(1,4)dioxin	58200-68-3	Intentional addition / 1,000ppm	chemical products
12820	1,2,3,6,8,9-Hexachlorodibenzo(b,e)(1,4)dioxin	58200-69-4	Intentional addition / 1,000ppm	chemical products
12821	1,2,3,4,6,7,9-Heptachlorodibenzo-p-dioxin	58200-70-7	Intentional addition / 1,000ppm	chemical products
12822	Ferrocene, polymer with 2-propanone	58228-03-8	Intentional addition / 1%	chemical products
12823	Diisopropyl cyanomethylphosphonate	58264-04-3	Intentional addition	chemical products
12824	Hydroxocobalamin hydrochloride	58288-50-9	Intentional addition / 1%	chemical products
12825	Strychnidin-10-one, sulfate (1:1), pentahydrate	58299-26-6	Contains (regardless of intentional or impurities)	chemical products
12826	Strychnidin-10-one, monohydrobromide, dihydrate	58299-27-7	Contains (regardless of intentional or impurities)	chemical products
12827	Cobaltate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]-, sodium	58302-43-5	Intentional addition / 1,000ppm	chemical products
12828	2-Naphthalenesulfonic acid, 6-amino-, monosodium salt	58306-86-8	Contains (regardless of intentional or impurities)	chemical products
12829	C.I. Pigment Red 108	58309-34-7	Contains (regardless of intentional or impurities)	chemical products
12830	Polyoxyethylene bisglyceryl borate	58369-24-7	Intentional addition / 1%	chemical products
12831	Phenol, methylenebis-, polymer with (chloromethyl)oxirane	58421-55-9	Contains (regardless of intentional or impurities)	chemical products
12832	Hexane, 1,2,5,6-tetrabromo-	58443-86-0	Intentional addition / 1,000ppm	chemical products
12833	D-glucio-Heptonic acid, (2.xi)-, ester with boric acid (H3BO3), sodium salt	58450-10-5	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
12834	Silicic acid, beryllium salt	58500-38-2	Contains (regardless of intentional or impurities)	chemical products
12835	Lithium boride (LiB12)	58572-50-2	Intentional addition / 1%	chemical products
12836	Cobalt nickel oxide (CoNiO2)	58591-45-0	Contains (regardless of intentional or impurities)	chemical products
12837	Di-mu-chlorodichlorobis[3,4-eta-4-methylpent-3-en-2-one]diplatinum	58601-82-4	Contains (regardless of intentional or impurities)	chemical products
12838	Benzeneacetonitrile, alpha-[[[1,1-dimethylethoxy]carbonyloxy]imino]-	58632-95-4	Intentional addition	chemical products
12839	Stannane, butyltris[(1-oxodocosyloxy)-	58636-10-5	Contains (regardless of intentional or impurities)	chemical products
12840	Benzene diazonium, 4-[ethyl(phenylmethyl)amino]-, tetrafluoroborate(1-)	58672-61-0	Intentional addition / 1%	chemical products
12841	Copper(2+), tetraaminediaqua	58675-51-7	Intentional addition / 1,000ppm	chemical products
12842	4-Aminonaphthalene-1-carbonitrile	58728-84-6	Intentional addition	chemical products
12843	Hydrochloric acid-d, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	58787-03-4	Contains (regardless of intentional or impurities)	chemical products
12844	1,2,4,5,8-Pentachlorodibenzo-p-dioxin	58802-09-7	Intentional addition / 1,000ppm	chemical products
12845	1,2,4,6,8,9-Hexachlorodibenzo(a,h)(1,4)dioxin	58802-09-8	Intentional addition / 1,000ppm	chemical products
12846	Thallium(1+) benzoic acid ethyl ester	58806-19-2	Intentional addition / 1,000ppm	chemical products
12847	Ethyl 4-nitro-3-phenyl-L-alaninate monohydrochloride	58816-86-3	Contains (regardless of intentional or impurities)	chemical products
12848	D-Glucose, 6-(dihydrogen phosphate), barium salt	58823-95-3	Contains (regardless of intentional or impurities)	chemical products
12849	Vanadyl pyrophosphate	58834-75-6	Contains (regardless of intentional or impurities)	chemical products
12850	Phenol, 4-tert-nonyl-	58865-77-3	Intentional addition / 1%	chemical products
12851	Hydroxylamine, phosphate (salt)	58888-47-4	Intentional addition / 1%	chemical products
12852	Beta-Cyclodextrin, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	58947-99-2	Contains (regardless of intentional or impurities)	chemical products
12853	1,4-Bis(pentabromophenoxy)tetraabromobenzene	58965-66-5	Intentional addition / 900ppm	chemical products
12854	Phenol, 2-cyclohexyl-, barium salt	58997-79-8	Intentional addition / 1,000ppm	chemical products
12855	1-Cyano-4-(dimethylamino)pyridinium tetrafluoroborate	59016-56-7	Intentional addition	chemical products
12856	4-(Hydroxymethyl)phenylboronic acid	59016-93-2	Intentional addition / 1%	chemical products
12857	3-Pyridyltributylstannane	59020-10-9	Contains (regardless of intentional or impurities)	chemical products
12858	Trihexylin hydride	59061-51-7	Contains (regardless of intentional or impurities)	chemical products
12859	2,2',3,3',5,5',6,6'-Octabromo-1,1'-biphenyl	59080-41-0	Intentional addition / 1,000ppm	chemical products
12860	Sodium phosphomolybdate	59088-14-1	Intentional addition / 1%	chemical products
12861	Gold telluride	59114-56-6	Contains (regardless of intentional or impurities)	chemical products
12862	(Methylstannylidene)tris(thioethylene) tristearate	59118-76-2	Contains (regardless of intentional or impurities)	chemical products
12863	Ethanol, 2,2',2''-[(methylstannylidene)tris(thio)tris-, triacetate	59118-77-3	Contains (regardless of intentional or impurities)	chemical products
12864	9-Octadecenoic acid (Z)-, (methylstannylidene)tris(thio-2,1-ethanedyl) ester	59118-79-5	Contains (regardless of intentional or impurities)	chemical products
12865	Octanoic acid, (butylstannylidene)tris(thio-2,1-ethanedyl) ester	59118-80-8	Contains (regardless of intentional or impurities)	chemical products
12866	Octanoic acid, (diethylstannylidene)bis(thio-2,1-ethanedyl) ester	59118-81-9	Contains (regardless of intentional or impurities)	chemical products
12867	Nonanoic acid, (methylstannylidene)tris(thio-2,1-ethanedyl) ester	59118-93-3	Contains (regardless of intentional or impurities)	chemical products
12868	Hydrogen sulfide (H3S)	59125-35-8	Intentional addition / 1%	chemical products
12869	(Dimethylstannylene)bis(thioethane-1,2-diyl) distearate	59138-44-2	Contains (regardless of intentional or impurities)	chemical products
12870	2-Bromotridecane	59157-17-4	Intentional addition / 1,000ppm	chemical products
12871	10-Oxa-4,6-dithia-5-stannahexadecanoic acid, 12-ethyl-5-[[[3-(2-ethylhexyloxy)-3-oxopropyl]thio]-5-octyl-9-oxo-, 2-ethylhexyl ester	59157-52-7	Contains (regardless of intentional or impurities)	chemical products
12872	Copper, [N,N'-diphenyl-29H,31H-phthalocyanine-C,C-disulfonamidato(2-)-N29,N30,N31,N32]-	59160-73-5	Intentional addition / 1,000ppm	chemical products
12873	Copper, [[2,2',2''-[29H,31H-phthalocyaninetriyltris(methylene)tris[1H-isoindeole-1,3(2H)-dionato]](2-)-N29,N30,N31,N32]-	59160-79-1	Intentional addition / 1,000ppm	chemical products
12874	Phosphoric acid, chromium(3+) salt (3:2)	59178-46-0	Contains (regardless of intentional or impurities)	chemical products
12875	10-Oxa-4,6-dithia-5-stannahexadecanoic acid, 12-ethyl-5,5-dioctyl-9-oxo-, 2-ethylhexyl ester	59185-95-4	Contains (regardless of intentional or impurities)	chemical products
12876	1-(2-Bromoethyl)-2,4-dibromobenzene	59216-17-0	Intentional addition / 1,000ppm	chemical products
12877	Cuprate(1-), chloro(cyano-C)-, lithium	59219-07-7	Intentional addition / 1,000ppm	chemical products
12878	Dodecylethanamine salt of the chromium complex of 1-(4-nitro-2-hydroxyphenylazo)-2-naphthol and 1-(5-nitro-2-hydroxyphenylazo)-2-naphthol	59307-44-7	Contains (regardless of intentional or impurities)	chemical products
12879	2-Ethylhexylamine salt of the chromium complex and 1-(2-hydroxy-4-nitrophenylazo)-2-hydroxynaphthalene and 1-(2-hydroxy-5-nitrophenylazo)-2-hydroxynaphthalene	59307-46-9	Contains (regardless of intentional or impurities)	chemical products
12880	Chromate(1-), [1-[[[2-hydroxy-4-nitrophenylazo]-2-naphthalenolato(2-)]][1-[[[2-hydroxy-5-nitrophenylazo]-2-naphthalenolato(2-)]]-, sodium	59307-49-2	Contains (regardless of intentional or impurities)	chemical products
12881	Hydrogen additives of endopropylene glycol polycondensate of 1-chloro-2,3-epoxypropane	59326-14-6	Contains (regardless of intentional or impurities)	chemical products
12882	2-Ethylhexyloxypropylamine salt of chromium complex of 4-(2'-hydroxy-5'-nitrophenylazo)-1-(3-aminophenyl)-3-methyl-5-pyrazolone	59335-19-2	Contains (regardless of intentional or impurities)	chemical products
12883	2-Ethylhexyloxypropylamine salt of chromium complex of 4-(2'-hydroxy-4'-nitrophenylazo)-1-(3-aminophenyl)-3-methyl-5-pyrazolone	59335-21-6	Contains (regardless of intentional or impurities)	chemical products
12884	3-Hydroxy-2,2,4-trimethyl pentane nitrile	59346-56-4	Intentional addition	chemical products
12885	Indium iodides	59392-50-6	Intentional addition / 1%	chemical products
12886	Potassium titanil arsenate	59400-80-5	Contains (regardless of intentional or impurities)	chemical products
12887	2-Propanoic acid, (pentabromophenyl)methyl ester	59447-55-1	Contains (regardless of intentional or impurities)	chemical products
12888	Poly(pentabromobenzyl acrylate)	59447-57-3	Intentional addition / 900ppm	chemical products
12889	Hydroxocobalamin monohydrochloride	59461-30-2	Intentional addition / 1%	chemical products
12890	Cobaltate(1-), [N-[[[5-(aminosulfonyl)-2-hydroxyphenylazo]-7-hydroxy-1-naphthalenyl]acetamidato(2-)]][3-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenylazo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]]-, sodium	59487-93-3	Intentional addition / 1,000ppm	chemical products
12891	Sodium bis[3-[[[1-(2-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzene-1-sulphonamidato(2-)]]chromate(1-)	59518-88-6	Contains (regardless of intentional or impurities)	chemical products
12892	Molybdenum potassium oxide (MoK03)	59519-73-2	Intentional addition / 1%	chemical products
12893	Bis(acetonitrile)molybdenum(IV) chloride	59560-72-4	Intentional addition / 1%	chemical products
12894	Cobalt(3+), hexaammine-, (OC-6-11)-, salt with trifluoroacetic acid (1:3)	59561-55-6	Intentional addition / 100ppm	chemical products
12895	Isobutyl (Z,Z)-10,10-dibutyl-2-methyl-5,8,12-trioxo-4,9,11-trioxo-10-stannapentadeca-6,13-dien-15-ate	59571-08-3	Contains (regardless of intentional or impurities)	chemical products
12896	Benzenamine, 4-methoxy-, chromium complex, compound with nicotine	59598-67-3	Contains (regardless of intentional or impurities)	chemical products
12897	Benzenamine, 4-ethoxy-, chromium complex, compound with nicotine	59598-68-4	Contains (regardless of intentional or impurities)	chemical products
12898	Benzenemethanamine, chromium complex, compound with nicotine	59598-69-5	Contains (regardless of intentional or impurities)	chemical products
12899	Chromate(1-), bis(benzenamine)tetrakis(thiocyanato-N)-, hydrogen, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	59598-70-8	Contains (regardless of intentional or impurities)	chemical products
12900	Chromate(1-), bis(pyridine)tetrakis(thiocyanato-N)-, (OC-6-12)-, hydrogen, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	59598-84-4	Contains (regardless of intentional or impurities)	chemical products
12901	Benzenamine, 4-methyl-, chromium complex, compound with nicotine	59599-00-7	Contains (regardless of intentional or impurities)	chemical products
12902	Thiodicarb	59689-26-0	Contains (regardless of intentional or impurities)	chemical products
12903	Vanadium, (2-methyl-2-propanolato)dioxo-	59700-70-8	Intentional addition / 1%	chemical products
12904	Benztriamide hydrochloride	59708-44-0	Intentional addition	chemical products
12905	Ethanol, 2-[[[2-(2-butoxyethoxy)ethoxy]-, triester with boric acid (H3BO3)	59719-94-7	Intentional addition / 1%	chemical products
12906	Tris(tridecyl) borate	59720-00-2	Intentional addition / 1%	chemical products
12907	Disodium tetracarboxylate(2-), compound with 1,4-dioxane (2:3)	59733-73-2	Intentional addition / 1%	chemical products
12908	Hydrazine, phosphate (2:1)	59739-45-2	Contains (regardless of intentional or impurities)	chemical products
12909	Calcium molybdenum zinc oxide	59768-81-3	Intentional addition / 1%	chemical products
12910	1H-Pyrrrole-2,5-dione, 1-(2,4,6-tribromophenyl)-	59789-51-4	Contains (regardless of intentional or impurities)	chemical products
12911	Tris(isotridecyl) borate	58802-06-1	Intentional addition / 1%	chemical products
12912	Tris[(2-methoxymethyl)ethoxy]propyl orthoborate	58817-49-1	Intentional addition / 1%	chemical products
12913	1-Pentene, 5-bromo-3-methyl-	58822-10-5	Intentional addition / 1,000ppm	chemical products
12914	Nickel lactate tetrahydrate	58836-85-0	Contains (regardless of intentional or impurities)	chemical products
12915	2-Butenoic acid, 4,4'-[[diethylstannylene]bis(oxo)]bis[4-oxo-, dicyclohexyl ester, (2Z,2Z)-	58849-87-5	Intentional addition / 1,000ppm	chemical products
12916	Strychnidin-10-one, compound with 2,4-dihydro-5-methyl-4-nitro-2-(4-nitrophenyl)-3H-pyrazol-3-one (1:1)	59863-84-2	Contains (regardless of intentional or impurities)	chemical products
12917	Vanadium trihydroxide	59865-92-8	Intentional addition / 1%	chemical products
12918	4-Chloro-2,3-dimethylpyridine N-oxide	59886-90-7	Intentional addition / 1%	chemical products
12919	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, diperchlorate	59888-66-3	Contains (regardless of intentional or impurities)	chemical products
12920	Hydroxyl amine iodide	59917-23-6	Intentional addition / 1,000ppm	chemical products
12921	Stannane, dibutylbis[(1-oxoisooctadecyl)oxy]-	59963-28-9	Contains (regardless of intentional or impurities)	chemical products
12922	Pentane nitrile, 4,4-dimethyl-3-oxo-	59997-51-2	Intentional addition	chemical products
12923	1,3-Benzenediamine, 4-methyl-, chromium complex, compound with nicotine	60004-81-1	Contains (regardless of intentional or impurities)	chemical products
12924	Boron carbide	60063-34-5	Intentional addition / 1%	chemical products
12925	1,4-Benzenediamine, 2-methyl-, chromium complex, compound with nicotine	60065-70-5	Contains (regardless of intentional or impurities)	chemical products
12926	Cobalt, bis[alpha-(1-oxo-1H-isoindol-3-yl)-1H-benzimidazole-2-acetonitrilo]-, (T-4)-	60109-88-8	Intentional addition / 1,000ppm	chemical products
12927	Nickel carbonyl (Ni3(CO))	60120-57-2	Contains (regardless of intentional or impurities)	chemical products
12928	Di-mu-chlorodichlorobis[1,2-eta-cyclohexene]diplatinum, stereoisomer	60134-75-0	Contains (regardless of intentional or impurities)	chemical products
12929	3-(Methylnitrosamino)propionitrile	60153-49-3	Contains (regardless of intentional or impurities)	chemical products
12930	3-Formamido-4-hydroxyphenylarsonic acid	60154-16-7	Contains (regardless of intentional or impurities)	chemical products
12931	Arsenic acid, iron(3+) salt (1:1)	60168-33-4	Contains (regardless of intentional or impurities)	chemical products
12932	Strychnidin-10-one, mononitrate, mixture with 3,7-dihydro-1,3,7-trimethyl-1H-purine-2,7-dione, (1.alpha.,2.alpha.,3.beta.,6.beta.,6a.beta.,8a.S*,8b.beta.,9R*)-hexahydro-2a-hydroxy-9-(1-hydroxy-1-methylthio)-8b-methyl-3,6-methano-8H-1,5,7-trioxacyclopenta[[cycloprop[azulene-4,8(3H)-dione,[1aR-(1.alpha.,2.alpha.,3.beta.,6.beta.,6a.beta.,8a.S*,8b.beta.,9R*)-hexahydro-2a-hydroxy-8b-methyl-9-(1-methylthio)-3,6-methano-8H-1,5,7-trioxacyclopenta[[cycloprop[azulene-4,8(3H)-dione, sodium benzoate and 6,7,8,9-tetrahydro-5H-tetrazolo[1,5]azepine	60181-70-6	Contains (regardless of intentional or impurities)	chemical products
12933	Arsenic acid, monosodium salt	60189-99-3	Contains (regardless of intentional or impurities)	chemical products
12934	Propiconazole	60207-90-1	Contains (regardless of intentional or impurities)	chemical products
12935	Naphthalenedisulfonic acid, dinonyl-	60223-95-2	Intentional addition / 1,000ppm	chemical products
12936	Manganese, [[1,2-ethanedyl]bis(carbamodithioato)](2-)-, mixture with dimethyl [1,2-phenylenebis(iminocarbonothioyl)]bis(carbamate) and [[1,2-ethanedyl]bis(carbamodithioato)](2-)]zinc	60240-47-3	Contains (regardless of intentional or impurities)	chemical products
12937	Trisodium [2-[alpha-[[[3-amino-2-hydroxy-4-sulphophenyl]azo]benzyl]azo]-5-sulphobenzoate(5-)]cuprate(3-)	60265-89-6	Intentional addition / 1,000ppm	chemical products
12938	Pentachlorotrifluoropropane	60285-54-3	Intentional addition	chemical products
12939	Hydrogen (ZS-trans)-[2,3-dihydro-2,3-dihydro-3,8,13,17-tetramethyl-7,12-divinyl-21H,23H-porphine-2,18-dipropionic acid, gamma-lactonato(3-)-N21,N22,N23,N24]tetrato(1-)	60318-31-2	Intentional addition / 1%	chemical products
12940	Nitric acid, ammonium silver(1+) salt (2:1)	60347-66-2	Intentional addition / 25%	chemical products
12941	Manganese, [[1,2-ethanedyl]bis(carbamodithioato)](2-)-, mixture with magnesium bis[[N,N-bis[(2-hydroxy-5-sulphophenyl)methyl]glycinato(3-)]cuprate(1-)]	60351-11-3	Intentional addition / 1,000ppm	chemical products
12942	Zinc, [[1,2-ethanedyl]bis(carbamodithioato)](2-)-, mixture with magnesium bis[[N,N-bis[(2-hydroxy-5-sulphophenyl)methyl]glycinato(3-)]cuprate(1-)]	60351-12-4	Intentional addition / 1,000ppm	chemical products

Table with columns: #, Substance Name, CAS-No, Misumi Standards (numbers as threshold), and Applicable Item. Contains 366 rows of chemical substances data.

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
13065	Pitch	61789-60-4	Contains (regardless of intentional or impurities)	chemical products
13066	Aluminum resinates	61789-65-9	Contains (regardless of intentional or impurities)	chemical products
13067	Naphthenic acids, barium salts	61789-67-1	Intentional addition / 1,000ppm	chemical products
13068	Quaternary ammonium compounds, benzylcoco alkyl dimethyl, chlorides	61789-71-7	Intentional addition / 1,000ppm	chemical products
13069	Di(coco alkyl) dimethyl ammonium chloride	61789-77-3	Intentional addition / 100ppm	chemical products
13070	Quaternary ammonium compounds, bis(hydrogenated tallow alkyl)dimethyl, chlorides	61789-80-8	Intentional addition / 100ppm	chemical products
13071	Calcium petroleum sulfonate	61789-86-4	Intentional addition / 1,000ppm	chemical products
13072	Magnesium petroleum sulfonate	61789-87-5	Intentional addition / 100ppm	chemical products
13073	Barium petroleum sulfonate	61789-48-5	Intentional addition / 1,000ppm	chemical products
13074	Resin acids and Rosin acids, sodium salts	61789-51-0	Intentional addition / 1,000ppm	chemical products
13075	Alcohols, coco, ethoxylated	61791-13-7	Intentional addition / 1%	chemical products
13076	2,4,5-T sec-butyl ester	61792-07-2	Intentional addition / 1,000ppm	chemical products
13077	Haustanoic acid, manganese(2+) salt	61810-04-6	Contains (regardless of intentional or impurities)	chemical products
13078	5,12-Trioxa-8-stannatetraconta-2,9-dienoic acid, 6,6-dibutyl-4,8,11-trioxo-, octadecyl ester, (Z,Z)-	61813-52-3	Contains (regardless of intentional or impurities)	chemical products
13079	C.I. Solvent Red 68	61813-90-9	Intentional addition / 1,000ppm	chemical products
13080	C.I. Sulphur Red 1	61814-39-9	Intentional addition / 1,000ppm	chemical products
13081	Oxaliplatin	61825-94-3	Contains (regardless of intentional or impurities)	chemical products
13082	Lignosulfonic acid, copper salt	61827-83-6	Intentional addition / 1,000ppm	chemical products
13083	Hexane, 2,5-dimethyl-3-(1-methylethyl)-	61868-66-4	Intentional addition / 1%	chemical products
13084	Acid Red 167	61901-41-5	Intentional addition / 1,000ppm	chemical products
13085	Cobaltate(1-), bis[4-(hydroxy-kappa O)-3-[[2-(hydroxy-kappa O)-1-naphthalenyl]azo-kappa N]]benzenesulfonamidate(2-)-, hydrogen	61901-42-6	Intentional addition / 1,000ppm	chemical products
13086	C.I. Solvent Black 29	61901-87-9	Intentional addition / 1,000ppm	chemical products
13087	2-Ethylhexyl [[triocystannyl]thio]acetate	61912-55-8	Contains (regardless of intentional or impurities)	chemical products
13088	Carboxymethyl cellulose copper salt	61912-85-4	Intentional addition / 1,000ppm	chemical products
13089	Chromate(3-), bis[4-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonate(3-)]-, trisodium	61916-41-4	Contains (regardless of intentional or impurities)	chemical products
13090	Chromate(3-), [3-hydroxy-4-[[2-(hydroxy-1-naphthalenyl)azo]-1-naphthalenesulfonate(3-)]][6-hydroxy-5-[[2-(hydroxy-1-naphthalenyl)azo]-1-naphthalenesulfonate(3-)]-, trisodium	61916-42-5	Contains (regardless of intentional or impurities)	chemical products
13091	C.I. Solvent Black 35	61931-53-1	Contains (regardless of intentional or impurities)	chemical products
13092	Benzenesulfonic acid, undecyl-, ammonium salt	61931-75-7	Intentional addition / 1%	chemical products
13093	Chromium, [2-hydroxy-3-[[[2-(hydroxyphenyl)methylene]amino]-5-nitrobenzenesulfonate(3-)-N3,O2,O3]-	61931-84-8	Intentional addition / 1,000ppm	chemical products
13094	Diisobutyltin oxide	61947-30-6	Intentional addition / 1,000ppm	chemical products
13095	Neodecanoic acid, cadmium salt	61951-96-0	Contains (regardless of intentional or impurities)	chemical products
13096	C.I. Disperse Red 151	61968-47-6	Intentional addition / 100ppm	chemical products
13097	C.I. Solvent Blue 53	61969-42-4	Intentional addition / 1%	chemical products
13098	Fumarate, ethyl-, copper	62008-24-6	Intentional addition / 1,000ppm	chemical products
13099	Zirconium oxide sulfate (Zr5O8(SO4)2)	62010-10-0	Contains (regardless of intentional or impurities)	chemical products
13100	Antimony nickel oxide	62010-30-4	Contains (regardless of intentional or impurities)	chemical products
13101	Abietic acid, chromium(III)	62037-24-5	Intentional addition / 1,000ppm	chemical products
13102	2,7,9-Trioxa-8-stannatrideca-4,11-dien-13-oiic acid, 8,8-dibutyl-1-[[1-methylethyl]phenyl]-3,6,10-trioxo-, [[1-methylethyl]phenyl]methyl ester, (Z,Z)-	62044-47-7	Intentional addition / 1,000ppm	chemical products
13103	Morpholine nitrite	62076-93-1	Intentional addition / 100ppm	chemical products
13104	Decane, 1,1,1-trichloro-	62108-56-9	Intentional addition / 1,000ppm	chemical products
13105	Dodecane, 1,1,1-trichloro-	62108-57-0	Intentional addition / 1,000ppm	chemical products
13106	Tetradodecylammonium perchlorate	62120-45-0	Intentional addition / 1,000ppm	chemical products
13107	Propane, 2-bromo-1-fluoro-	62122-17-2	Intentional addition / 1,000ppm	chemical products
13108	Butane, 2,2,3-tribromo-	62127-47-3	Intentional addition / 1,000ppm	chemical products
13109	1,2-Dibromo-1-fluoro-(R*(R*))propane	62135-10-8	Intentional addition / 1,000ppm	chemical products
13110	1,2-Dibromo-1-fluoro-(R*(S*))propane	62135-11-9	Intentional addition / 1,000ppm	chemical products
13111	Propane, 1-bromo-1-fluoro-	62135-12-0	Intentional addition / 1,000ppm	chemical products
13112	Propionic acid, 2-chloro-, (+)	62138-52-7	Intentional addition / 1,000ppm	chemical products
13113	Phosphorus sulfides, P4Sx	62140-13-0	Intentional addition / 1%	chemical products
13114	Cadmium bis(heptadecanoate)	62149-56-8	Contains (regardless of intentional or impurities)	chemical products
13115	Dodecyl (Z,Z,Z)-6-butyl-6-[[4-(dodecyloxy)-1,4-dioxabut-2-enyl]oxy]-5,7,12-trioxa-6-stannatetradeca-2,9-dienoate	62149-82-0	Contains (regardless of intentional or impurities)	chemical products
13116	1,1-Dibromooctane	62168-26-7	Intentional addition / 1,000ppm	chemical products
13117	Molybdenum titanium carbide nitride	62169-57-7	Intentional addition / 1%	chemical products
13118	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, ethanedioate (2:1)	62201-70-1	Contains (regardless of intentional or impurities)	chemical products
13119	Tetakis(decylammonium) perchlorate	62207-11-8	Intentional addition / 1,000ppm	chemical products
13120	Cobalt, ((2,2-(1,2-ethanediybis(nitro)methylidene)bis(6-fluorophenolato))(2)-N,N',O,O')-	62207-76-5	Intentional addition / 1,000ppm	chemical products
13121	Tetrahydrogen [mu-[[4-[[[6-[[3,3-dihydroxy-4-[[1-(hydroxy-3,8-disulpho-2-naphthyl)azo][1,1'-biphenyl]-4-yl]azo]-5-hydroxy-7-sulpho-2-naphthyl]amino]phenoxy]acetato(6-)]dicuprate(4-)]-	62271-30-1	Intentional addition / 1,000ppm	chemical products
13122	5-Methylfuran-2-boronic acid	62306-79-0	Intentional addition / 1%	chemical products
13123	Stannane, tris[[2-ethyl-1-oxohexyloxy]methyl]-	62312-12-3	Contains (regardless of intentional or impurities)	chemical products
13124	Diazenedicarboxylic acid, barium salt	62312-94-1	Intentional addition / 1,000ppm	chemical products
13125	Zirconium decanoate	62317-00-4	Contains (regardless of intentional or impurities)	chemical products
13126	Copper, hydroxy(2-hydroxybenzoato-O1,O2)-	62320-94-9	Intentional addition / 1,000ppm	chemical products
13127	Disodium 3,6-bis((o-arsenophenyl)azo)-4,5-dihydroxynaphthalene-2,7-disulphonate	62337-00-2	Contains (regardless of intentional or impurities)	chemical products
13128	Cuprate(3-), [5-amino-3-[[3-chloro-2-hydroxy-5-sulphophenyl]azo]-4-hydroxy-2,7-naphthalenedisulfonate(5-)]-, trihydrogen	62364-11-8	Intentional addition / 1,000ppm	chemical products
13129	Benzenediazonium, 4-(phenylamino)-, tetrafluoroborate(1-), polymer with formaldehyde	62428-08-4	Intentional addition / 1%	chemical products
13130	Strychnine, hexabromoosmate(IV)	62459-34-1	Contains (regardless of intentional or impurities)	chemical products
13131	1,3,7,9-Tetrachlorodibenzo-p-dioxin	62470-53-5	Intentional addition / 1,000ppm	chemical products
13132	1,2,8,9-Tetrachlorodibenzo(b,e)(1,4)dioxin	62470-54-6	Intentional addition / 1,000ppm	chemical products
13133	1-Chloro-2-(dichloromethyl)-3-fluorobenzene	62476-62-4	Intentional addition / 1,000ppm	chemical products
13134	Octadecyl (Z,Z)-6,6-dioctyl-4,8,11-trioxo-5,7,12-trioxa-6-stannatetraconta-2,9-dienoate	62480-03-9	Contains (regardless of intentional or impurities)	chemical products
13135	Butanedioic acid, 2,3-dihydroxy-[R-(R*(R*))-, chromium(3+) salt	62498-20-8	Intentional addition / 1,000ppm	chemical products
13136	Chromate(2-), [5-chloro-3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxybenzenesulfonate(3-)]][4-[[3,5-dichloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, disodium	62524-44-1	Contains (regardless of intentional or impurities)	chemical products
13137	(R)-2-(2-Chlorophenyl)oxirane	62566-66-9	Contains (regardless of intentional or impurities)	chemical products
13138	Cobaltate(3-), bis[4-[[2-[[2-(hydroxy-5-nitrophenyl)azo]-1,3-dioxobutyl]amino]-5-methoxy-2-methylbenzenesulfonate(3-)]-, trihydrogen	62598-42-9	Intentional addition / 1,000ppm	chemical products
13139	(R)-3-chlorophenyl oxirane	62600-71-9	Contains (regardless of intentional or impurities)	chemical products
13140	Iodonium, diphenyl-, hexafluoroarsenate(1-)	62613-15-4	Contains (regardless of intentional or impurities)	chemical products
13141	Cobalt carbonate hydroxide	62647-83-0	Intentional addition / 1%	chemical products
13142	Chromium, Fluoro[29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-5-12)-	62654-05-1	Intentional addition / 1,000ppm	chemical products
13143	Benzo[c]xanthylum, 3,6-dihydro-3-methoxy-, tetrafluoroborate(1-)	62654-11-9	Intentional addition / 1%	chemical products
13144	Acetonitrile-2-13C-2,2-d3	62663-01-8	Intentional addition / 1,000ppm	chemical products
13145	Europium tribromate	62667-63-4	Intentional addition / 1%	chemical products
13146	Benzo[a]phenoxazin-7-ium, 5,9-bis(ethylamino)-10-methyl-, perchlorate	62669-60-7	Intentional addition / 1,000ppm	chemical products
13147	Naphtho[2,3-d]thiazolium, 2-[2-[[2-(diphenylamino)-3-[[3-(4-methoxy-4-oxobutyl)naphtho[2,3-d]thiazol-2(3H)-ylidene]ethylidene]-1-cyclopenten-1-yl]ethenyl]-3-(4-methoxy-4-oxobutyl)-, perchlorate	62669-62-9	Intentional addition / 1,000ppm	chemical products
13148	Cyclohexanecarboxylic acid, barium salt	62669-65-2	Contains (regardless of intentional or impurities)	chemical products
13149	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(ethylamino)-2,7-dimethyl-, perchlorate	62669-66-3	Intentional addition / 1,000ppm	chemical products
13150	Xanthylum, 3,6-bis(diethylamino)-, perchlorate	62669-69-6	Intentional addition / 1,000ppm	chemical products
13151	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(dimethylamino)-, perchlorate	62669-72-1	Intentional addition / 1,000ppm	chemical products
13152	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(methylamino)-, perchlorate	62669-77-6	Intentional addition / 1,000ppm	chemical products
13153	Cyclohexanol, 5-methyl-2-(1-methylethyl)-, triester with boric acid(H3BO3), stereoisomer	62697-74-9	Intentional addition / 1%	chemical products
13154	Tripotassium arsenate 3/2 hydrate	62702-52-7	Intentional addition / 1,000ppm	chemical products
13155	Manganese, [[1,2-ethanediybis(carbamodithioato)](2)-], mixture with [[1,2-ethanediybis(carbamodithioato)](2)-]zinc and methyl 1H-benzimidazol-2-ylcarbamate	62713-28-4	Contains (regardless of intentional or impurities)	chemical products
13156	[Pentachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	62726-15-2	Intentional addition / 1,000ppm	chemical products
13157	Chromium, tris[1-(2-hydroxyphenyl)ethanonato-O,O']-	62744-21-2	Intentional addition / 1,000ppm	chemical products
13158	4-(2,3-Epoxypropoxy)-2-methyl-1,2-dihydroisoquinolin-2-one	62775-08-0	Contains (regardless of intentional or impurities)	chemical products
13159	1,4-Benzenediamine, N,N-dimethyl-, ethanedioate (2:1)	62778-12-5	Intentional addition	chemical products
13160	Cobalt(II) oxalate hydrate	62782-24-5	Intentional addition / 1%	chemical products
13161	Isoxazolium, 2-(1,1-dimethylethyl)-5-methyl-, tetrafluoroborate(1-)	62796-26-3	Intentional addition / 1%	chemical products
13162	Carbamothioic acid, dimethyl-, S-(4-phenoxybutyl)ester	62850-32-2	Intentional addition / 1%	chemical products
13163	Antimony, [mu-[[29H,31H-phthalocyaninato(2-)]]di-	62851-41-6	Contains (regardless of intentional or impurities)	chemical products
13164	Cadmium sulfide mixture with zinc sulfide	62865-26-3	Contains (regardless of intentional or impurities)	chemical products
13165	1-Decene, 10-bromo-	62871-09-4	Intentional addition / 1,000ppm	chemical products
13166	1,2-Dicarbadodecaborane(12), 1-[[ethylthio]methyl]-	62906-35-8	Intentional addition / 1%	chemical products
13167	1,2-Dicarbadodecaborane(12), 1-[[propylthio]methyl]-	62906-36-9	Intentional addition / 1%	chemical products
13168	1,2-Dicarbadodecaborane(12)-1-methanol, propanoate	62906-37-0	Intentional addition / 1%	chemical products
13169	Dichlorodihydroxybis(isopropylamine)platinum	62928-11-4	Contains (regardless of intentional or impurities)	chemical products
13170	Propanenitrile, 3-(dichloromethylsilyl)-, polymer with 3,3'-(1,7-dicarbadodecaborane(12)-1,7-diyl)bis[1,1,3,3-tetramethylsiloxanol]	62991-16-6	Intentional addition / 1%	chemical products
13171	Heptabromodibenzofuran	62994-32-5	Intentional addition / 100ppm	chemical products
13172	Dvanadium carbide nitride	62997-24-4	Intentional addition / 1%	chemical products
13173	Potassium zinc chromate	63020-43-9	Intentional addition / 1,000ppm	chemical products
13174	Xanthylum, 9-(2-ethoxycarbonyl)phenyl)-3,6-bis(ethylamino)-2,7-dimethyl-, molybdatesulfate	63022-06-0	Intentional addition / 1%	chemical products
13175	Cyclopentylboronic acid	63076-51-7	Intentional addition / 1%	chemical products
13176	Phenol, 2,4,6-trinitro-, nickel(2+) salt	63085-06-3	Contains (regardless of intentional or impurities)	chemical products
13177	Trisodium [5-acetamido-4-hydroxy-3-[[2-hydroxy-4-[[2-(sulphoxy)ethyl]sulphonyl]phenyl]azo]naphthalene-2,7-disulphonato(5-)]cuprate(3-)	63105-49-7	Intentional addition / 1,000ppm	chemical products
13178	Pyridinium, 1-methoxy-4-phenyl-, tetrafluoroborate(1-)	63123-42-2	Intentional addition / 1%	chemical products
13179	Boronic acid, B-(4-ethylphenyl)-	63139-21-9	Intentional addition / 1%	chemical products
13180	Benzeneselenazolium, 2-methyl-3-(3-sulfobutyl)-, inner salt	63149-25-7	Contains (regardless of intentional or impurities)	chemical products
13181	Pyridinium, 2-methyl-4,6-bis(4-methylphenyl)-1-(methylphenylamino)-, tetrafluoroborate(1-)	63149-30-4	Intentional addition / 1%	chemical products
13182	Formic acid, chromium(3+) sodium salt (4:1)	63182-21-8	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
13183	2-Chloro-3-ethylbenzoxazolium tetrafluoroborate	63212-53-3	Intentional addition / 1%	chemical products
13184	Benzene diazonium, 4-(ethylamino)-2-methyl-, hexafluoroarsenate(1-)	63217-32-3	Contains (regardless of intentional or impurities)	chemical products
13185	Benzene diazonium, 4-(diethylamino)-2-ethoxy-, hexafluoroarsenate(1-)	63217-33-4	Contains (regardless of intentional or impurities)	chemical products
13186	Chromate(1-), bis[2-hydroxybenzoato(2-)-O1,O2]-, sodium	63231-86-7	Contains (regardless of intentional or impurities)	chemical products
13187	Strychnidin-10-one, compound with trans-(±)-1,2-cyclopentenediylbis(hydrogen sulfate) (2:1)	63261-47-2	Contains (regardless of intentional or impurities)	chemical products
13188	3-Hexene, 1-bromo-, (E)-	63281-96-9	Intentional addition / 1,000ppm	chemical products
13189	2-Hexene, 6-bromo-, (Z)-	63281-98-1	Intentional addition / 1,000ppm	chemical products
13190	Strychnidin-10-one, mono[(R)-3-formyl-2,2-dimethyl-4-thiazolidinecarboxylate]	63284-32-2	Contains (regardless of intentional or impurities)	chemical products
13191	1,2,4-Benzenetriazine, 6-(2-formyl-2,2-dimethyl-4-thiazolidinecarboxylate)	63284-33-3	Contains (regardless of intentional or impurities)	chemical products
13192	Cobalt, bis[3-(1H-benzimidazol-2-ylamino)-1H-imidazol-1-onato]-, (T-4)-	63287-28-5	Intentional addition / 1,000ppm	chemical products
13193	9-Octadecenoic acid (2Z)-, monoester with 1,2,3-propanetriol ester with boric acid (H3BO3)	63310-18-7	Intentional addition / 1%	chemical products
13194	Hydrogen sulfide (H2S)	63344-86-5	Intentional addition / 1%	chemical products
13195	Boron, chlorothiodiol[thiobis(methane)]-, (T-4)-	63348-81-2	Intentional addition / 1%	chemical products
13196	Tetrakis[2,6,6-tetramethylheptane-3,5-dionato]hafnium	63370-90-1	Intentional addition / 1%	chemical products
13197	Copper, [5-benzoyl-4-hydroxy-2-methoxybenzenesulfonato(2-)]-, homopolymer	63373-74-0	Intentional addition / 1,000ppm	chemical products
13198	Barium 3-mercaptopropionate	63387-32-6	Intentional addition / 1,000ppm	chemical products
13199	Chromate(3-), bis[7-amino-4-hydroxy-3-[(2-hydroxy-4-nitrophenylazo)-2-naphthalenesulfonato(3-)]-, trihydrogen	63388-88-5	Contains (regardless of intentional or impurities)	chemical products
13200	Cuprate(4-), [7-[(2,5-dihydroxy-7-sulfo-1-naphthalenyl)azo]-8-hydroxy-1,3,5-naphthalenetrisulfonato(6-)]-, tetrasodium	63395-37-9	Intentional addition / 1,000ppm	chemical products
13201	Propanoic acid, 3,3'-bis[[2-(isooctyl)oxy]-2-oxoethyl]thio]stannylene]bis-, dibutyl ester	63397-60-4	Contains (regardless of intentional or impurities)	chemical products
13202	Cadmium pentadecanoate	63400-09-9	Contains (regardless of intentional or impurities)	chemical products
13203	Hydrazinecarboxaldehyde, 2-(4-aminophenyl)-	63402-26-6	Contains (regardless of intentional or impurities)	chemical products
13204	Copper(2+), bis[1,2-ethanediamine-N,N')-, (SP-4-1)-tetrakis(cyano-C)nickelate(2-)(1:1)	63427-32-7	Contains (regardless of intentional or impurities)	chemical products
13205	Propanoic acid, 3-[tris[[2-(isooctyl)oxy]-2-oxoethyl]thio]stannyl]-, butyl ester	63438-80-2	Contains (regardless of intentional or impurities)	chemical products
13206	Quaternary ammonium compounds, benzyl-C8-18-alkyldimethyl, chlorides	63449-41-2	Contains (regardless of intentional or impurities)	chemical products
13207	1,3,5-Triazine, 2,4,6-tri-2-pyridinyl-, monoperochlorate	63451-30-9	Intentional addition / 1,000ppm	chemical products
13208	Magnesium, bromo(hydroxytetraphenylarsinato)-	63468-73-5	Contains (regardless of intentional or impurities)	chemical products
13209	Chromium cobalt iron oxide	63497-09-6	Intentional addition / 1,000ppm	chemical products
13210	3-Chlorophenylboronic acid	63503-60-6	Intentional addition / 1%	chemical products
13211	Cuprate(4-), [29H,31H-phthalocyanine-C.C.C.C-tetrasulfonato(6-)-N29,N30,N31,N32]-, tetrahydrogen, compound with N,N,N',N'-triphenylguanidine (1:4)	63526-72-7	Intentional addition / 1,000ppm	chemical products
13212	Benzenamine, N-ethyl-3-methyl-, hydrochloride	63549-45-1	Intentional addition / 25%	chemical products
13213	2,3,6,7,12,13,16,17-Octahydro-9-(trifluoromethyl)-1H,5,11H,15H-xantheno[3,4-i:5,6,7-j']diquinolin-18-ium perchlorate	63561-42-2	Intentional addition / 1,000ppm	chemical products
13214	Nickelate(4-), [[nitrioltris(methylene)tris(phosphonato)](6-)-N.OP.OP.OP]-, tetrapotassium, (T-4)-	63588-33-0	Contains (regardless of intentional or impurities)	chemical products
13215	Cobaltate(4-), [[nitrioltris(methylene)tris(phosphonato)](6-)-N.OP.OP.OP]-, tetrapotassium, (T-4)-	63588-34-1	Intentional addition / 1,000ppm	chemical products
13216	Cuprate(4-), [[nitrioltris(methylene)tris(phosphonato)](6-)-N.OP.OP.OP]-, tetrapotassium, (T-4)-	63588-36-3	Intentional addition / 1,000ppm	chemical products
13217	Benzenesulfonic acid, 4-dodecyl-, compound with 4,4'-carbonimidoylbis[N,N-dimethylbenzenamine] (1:1)	63589-43-5	Contains (regardless of intentional or impurities)	chemical products
13218	Sulfuric acid, iron(2+) salt (2:1), compound with 1,2-ethanediamine (1:1)	63589-59-3	Intentional addition / 1%	chemical products
13219	1,2,4-Benzenetricarboxylic acid, compound with 2-ethyl-4-methyl-1H-imidazole-1-propanenitrile (1:1)	63592-54-1	Intentional addition	chemical products
13220	Cobaltate(3-), [N,N-bis(phosphonomethyl)glycinate(5-)]-, tripotassium, (T-4)-	63597-33-1	Intentional addition / 1,000ppm	chemical products
13221	Nickelate(3-), [N,N-bis(phosphonomethyl)glycinate(5-)]-, tripotassium, (T-4)-	63597-34-2	Contains (regardless of intentional or impurities)	chemical products
13222	Ferrate(2-), [5-[[2,4-dihydroxy-5-[(2-hydroxy-4,6-dinitrophenyl)azo]phenyl]azo]-4-hydroxy-3-[(4-nitrophenyl)azo]-2,7-naphthalenedisulfonato(4-)]-, disodium	63600-31-7	Intentional addition / 1%	chemical products
13223	Potassium [N,N-bis(carboxymethyl)glycinate(3-)-N.O.O.O']cobaltate(1-)	63640-17-5	Intentional addition / 1,000ppm	chemical products
13224	Potassium [N,N-bis(carboxymethyl)glycinate(3-)-N.O.O.O']nickelate(1-)	63640-18-6	Contains (regardless of intentional or impurities)	chemical products
13225	Cyxonanil-mancozeb mixture	63665-25-8	Contains (regardless of intentional or impurities)	chemical products
13226	2-Heptene, 1-bromo-, (Z)-	63712-23-4	Intentional addition / 1,000ppm	chemical products
13227	Lithium hydrotrisobutylborate(1-)	63717-72-7	Intentional addition / 1%	chemical products
13228	Diammonium aspartatechlorohydrodate	63771-33-5	Contains (regardless of intentional or impurities)	chemical products
13229	Aluminum barium magnesium oxide	63774-65-0	Intentional addition / 1,000ppm	chemical products
13230	Benzothiazolium, 2-[2-[(3-ethyl-5-methoxy-2(3H)-benzosenelazolylidene)methyl]-1-butenyl]-6-methoxy-5-methyl-3-(4-sulfopropyl)-, inner salt	63815-64-5	Contains (regardless of intentional or impurities)	chemical products
13231	Quinolinium, 6-methoxy-1-(phenylmethyl)-2-[[3-(4-sulfobutyl)-2(3H)-benzosenelazolylidene)methyl]-, inner salt	63815-75-8	Contains (regardless of intentional or impurities)	chemical products
13232	Benzeneselenazolium, 5-methoxy-2-methyl-3-(4-sulfobutyl)-, inner salt	63815-76-9	Contains (regardless of intentional or impurities)	chemical products
13233	Benzeneselenazolium, 2-methyl-3-(4-sulfobutyl)-, inner salt	63815-80-5	Contains (regardless of intentional or impurities)	chemical products
13234	Benzothiazolium, 2-[2-[(3-ethyl-5-methoxy-2(3H)-benzosenelazolylidene)methyl]-1-butenyl]-6-methoxy-5-methyl-3-(3-sulfopropyl)-, inner salt	63815-98-5	Contains (regardless of intentional or impurities)	chemical products
13235	1H-Imidazo[4,5-b]quinoxalinium, 6-chloro-2-[2-(1-ethyl-2,3-dihydro-5-methyl-3-oxo-2-phenyl-1H-pyrazol-4-yl)ethenyl]-1,3-diphenyl-, perchlorate	63816-06-8	Intentional addition / 1,000ppm	chemical products
13236	Quinolinium, 6-methoxy-1-(phenylmethyl)-2-[[3-(3-sulfopropyl)-2(3H)-benzosenelazolylidene)methyl]-, inner salt	63816-07-9	Contains (regardless of intentional or impurities)	chemical products
13237	Selenocyanic acid, 4-methoxy-2-nitrophenyl ester	63816-14-8	Contains (regardless of intentional or impurities)	chemical products
13238	Benzenamine, 2,2'-diselenobis(5-methoxy-	63816-15-9	Contains (regardless of intentional or impurities)	chemical products
13239	Benzothiazolium, 3-ethyl-2-[2-[(3-ethyl-5-methoxy-2(3H)-benzosenelazolylidene)methyl]-1-butenyl]-6-methyl-, iodide	63816-16-0	Contains (regardless of intentional or impurities)	chemical products
13240	Benzeneselenazolium, 3-ethyl-5-methoxy-2-[[2-(methylthio)-1-butenyl]-, iodide	63816-17-1	Contains (regardless of intentional or impurities)	chemical products
13241	Nickel alloy, base, Ni 62.0-68.0,Cu 28-38,Mn 0-4.0,Fe 0-2.5,Si 0-1.5,Ti 0-1.0,Al 0-0.75,C 0-0.15,P 0-0.02,S 0-0.015 (UNS W84190)	63850-92-0	Contains (regardless of intentional or impurities)	chemical products
13242	Zirconium picramate	63868-82-6	Contains (regardless of intentional or impurities)	chemical products
13243	Mersalyl theophylline	63869-00-1	Contains (regardless of intentional or impurities)	chemical products
13244	Trimethytin sulphate	63869-87-4	Contains (regardless of intentional or impurities)	chemical products
13245	Benzenamine, 2,2'-diselenobis-	63870-44-0	Contains (regardless of intentional or impurities)	chemical products
13246	Quinolinium, 1-ethyl-2-[[3-ethyl-2(3H)-benzosenelazolylidene)methyl]-6-methyl-, iodide	63870-48-4	Contains (regardless of intentional or impurities)	chemical products
13247	Hydrogen bis[2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]chromate(1-), compound with 2-aminoethanol (1:1)	63872-05-9	Contains (regardless of intentional or impurities)	chemical products
13248	Zinc ammonium nitrite	63885-01-8	Contains (regardless of intentional or impurities)	chemical products
13249	Propane, 1-bromo-1,1,2,2,3,3-hexafluoro-	63905-11-3	Intentional addition / 1,000ppm	chemical products
13250	Acetic acid, fluoro-, aluminum salt	63905-85-1	Intentional addition	chemical products
13251	Acetic acid, fluoro-, calcium salt	63905-86-2	Intentional addition	chemical products
13252	Acetic acid, fluoro-, magnesium salt	63905-88-4	Intentional addition	chemical products
13253	Acetic acid, fluoro-, thallium(1+) salt	63905-90-8	Intentional addition / 1,000ppm	chemical products
13254	Acetic acid, selenocyno-, butyl ester	63906-49-0	Contains (regardless of intentional or impurities)	chemical products
13255	Acetic acid, selenocyno-, potassium salt	63906-50-3	Contains (regardless of intentional or impurities)	chemical products
13256	Thallium(I) sulfate	63906-56-9	Intentional addition / 1,000ppm	chemical products
13257	Mercurate(1-), [3-(4-(carboxylatometoxy)phenyl)-2-hydroxypropyl]hydroxy-, sodium	63907-33-5	Contains (regardless of intentional or impurities)	chemical products
13258	Benzothiazolium, 5-chloro-3-ethyl-2-[2-[[5-methoxy-3-(4-sulfobutyl)-2(3H)-benzosenelazolylidene)methyl]-1-butenyl]-, inner salt	63907-45-9	Contains (regardless of intentional or impurities)	chemical products
13259	Chromate(1-), bis[5-(aminosulfonyl)-2-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-, hydrogen	63910-74-7	Contains (regardless of intentional or impurities)	chemical products
13260	Sodium beryllium malate	63915-76-4	Contains (regardless of intentional or impurities)	chemical products
13261	Benzene, pentabromo(tetrabromophenoxy)-	63936-56-1	Contains (regardless of intentional or impurities)	chemical products
13262	Chlorotetrafluoroethane	63938-10-3	Contains (regardless of intentional or impurities)	chemical products
13263	2-Propanoic acid, 3-phenyl-, nickel(2+) salt	63938-16-9	Contains (regardless of intentional or impurities)	chemical products
13264	Silicic acid, aluminum silver salt	63939-08-2	Intentional addition / 25%	chemical products
13265	Cuprate(1-), [C-(aminosulfonyl)-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, sodium	63950-02-7	Intentional addition / 1,000ppm	chemical products
13266	Aniline, arsenate	63957-41-5	Contains (regardless of intentional or impurities)	chemical products
13267	Cobaltate(1-), bis[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonamidato(2-)]-, ammonium	63971-70-0	Intentional addition / 1,000ppm	chemical products
13268	Phosphorous acid, bis(2-ethylhexyl) ester, barium salt	63981-01-1	Intentional addition / 1,000ppm	chemical products
13269	Selenium, (4-acetamidophenyl)dihydroxy-	63981-20-4	Contains (regardless of intentional or impurities)	chemical products
13270	Selenocyanic acid, 2-oxo-2-(phenylamino)ethyl ester	63981-21-5	Contains (regardless of intentional or impurities)	chemical products
13271	Copper, [N,N',N''-tetrabutyl-29H,31H-phthalocyanine-C.C.C.C-tetrasulfonamidato(2-)-N29,N30,N31,N32]-	63982-56-9	Intentional addition / 1,000ppm	chemical products
13272	Chromate(3-), bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfophenyl)-1H-pyrazol-4-yl]azo]benzoato(3-)]-, trihydrogen, compound with N-cyclohexyl-1-cyclohexanamine (1:2)	63982-58-1	Contains (regardless of intentional or impurities)	chemical products
13273	Heptane, 1,1,7,7-tetrachloro-3,3,5,5-tetramethyl-	63988-32-9	Intentional addition / 1,000ppm	chemical products
13274	Iron arsenite oxide (Fe2(AsO3)2O3), pentahydrate	63989-69-5	Contains (regardless of intentional or impurities)	chemical products
13275	Boron sodium oxide (B4Na2O7), heptahydrate	63989-70-8	Intentional addition / 1%	chemical products
13276	3,5-Dinitro-p-cresol	63989-82-2	Intentional addition	chemical products
13277	Beryllium oxyfluoride	63990-88-5	Contains (regardless of intentional or impurities)	chemical products
13278	Hexanoic acid, 3,5,5-trimethyl-, manganese(2+) salt	64002-83-1	Contains (regardless of intentional or impurities)	chemical products
13279	Magnesium perchlorate hydrate	64010-42-0	Intentional addition / 1,000ppm	chemical products
13280	Stibine, tri-2-pyridyl-	64011-26-3	Contains (regardless of intentional or impurities)	chemical products
13281	o-Toluidine antimonyl tartrate	64011-35-4	Contains (regardless of intentional or impurities)	chemical products
13282	p-Toluidine antimonyl tartrate	64011-36-5	Contains (regardless of intentional or impurities)	chemical products
13283	Antimonate(2-), bis[mu-[2,3-dihydroxybutanedioato(4-)-O1,O2,O3,O4]]di-, stereoisomer, dihydrogen, compound with urea (1:1)	64024-08-4	Contains (regardless of intentional or impurities)	chemical products
13284	Ammonium potassium selenide mixed with ammonium potassium sulfide	64046-00-0	Contains (regardless of intentional or impurities)	chemical products
13285	Arsonos dicyanide, pertyl-	64046-74-8	Contains (regardless of intentional or impurities)	chemical products
13286	Arsine, bis(2-chloroethenyl)phenyl-	64046-75-9	Contains (regardless of intentional or impurities)	chemical products
13287	Antimony, bis(trichloro-, compound with 1 mol of octamethyl pyrophosphoramidate	64046-83-1	Contains (regardless of intentional or impurities)	chemical products
13288	Arsonos dichloride, 2-propenyl-	64047-01-4	Contains (regardless of intentional or impurities)	chemical products
13289	Mercurate(1-), butyl(mercaptacetato(2-)-O,S)-, sodium	64048-05-1	Contains (regardless of intentional or impurities)	chemical products
13290	Mercurate(1-), ethyl(mercaptacetato(2-)-O,S)-, potassium	64048-06-2	Contains (regardless of intentional or impurities)	chemical products
13291	Mercurate(1-), mercaptoacetato(2-)-O,S)methyl-, sodium	64048-07-3	Contains (regardless of intentional or impurities)	chemical products
13292	Arsonos dichloride, (2-phenylthio)-	64048-88-0	Contains (regardless of intentional or impurities)	chemical products
13293	Arsonos dichloride, 4-pentenyl-	64048-89-1	Contains (regardless of intentional or impurities)	chemical products
13294	Arsonos dichloride, [3-(trifluoromethyl)phenyl]-	64048-90-4	Contains (regardless of intentional or impurities)	chemical products
13295	Arsine, tri-2-furyl-	64048-96-0	Contains (regardless of intentional or impurities)	chemical products
13296	Arsine, tris(3,3,5-trimethylcyclohexyl)-	64048-98-2	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
13297	Arsonium, diethyl(3-hydroxyphenyl)methyl-, iodide	64048-99-3	Contains (regardless of intentional or impurities)	chemical products
13298	Arsinous chloride, butylethyl-	64049-05-4	Contains (regardless of intentional or impurities)	chemical products
13299	Arsinous cyanide, butylethyl-	64049-06-5	Contains (regardless of intentional or impurities)	chemical products
13300	Arsinous chloride, di-2-furanyl-	64049-08-7	Contains (regardless of intentional or impurities)	chemical products
13301	Arsinothious acid, dimethyl-, 2-chloroethyl ester	64049-09-8	Contains (regardless of intentional or impurities)	chemical products
13302	Arsonodithious acid, (2-chloroethenyl)-, dimethyl ester	64049-10-1	Contains (regardless of intentional or impurities)	chemical products
13303	Arsonosous acid, (2-chloroethenyl)-, diethyl ester	64049-11-2	Contains (regardless of intentional or impurities)	chemical products
13304	Arsonosous acid, (2-chloroethenyl)-, dimethyl ester	64049-12-3	Contains (regardless of intentional or impurities)	chemical products
13305	Arsinous cyanide, diethyl-	64049-14-5	Contains (regardless of intentional or impurities)	chemical products
13306	Arsinous cyanide, di-2-furanyl-	64049-15-6	Contains (regardless of intentional or impurities)	chemical products
13307	Arsinous cyanide, ethylpropyl-	64049-16-7	Contains (regardless of intentional or impurities)	chemical products
13308	Arsonosous dibromide, (2-chloroethyl)-	64049-17-8	Contains (regardless of intentional or impurities)	chemical products
13309	Arsonosous dichloride, hexyl-	64049-22-5	Contains (regardless of intentional or impurities)	chemical products
13310	Arsonosous dichloride, (3-methylbutyl)-	64049-23-6	Contains (regardless of intentional or impurities)	chemical products
13311	Arsonosous dichloride, (2-methoxyethyl)-	64049-24-7	Contains (regardless of intentional or impurities)	chemical products
13312	Arsonosous dichloride, (2-methylbutyl)-	64049-25-8	Contains (regardless of intentional or impurities)	chemical products
13313	Aniline, 4,4'-methylenebis(2-chloro-, hydrochloride	64049-29-2	Contains (regardless of intentional or impurities)	chemical products
13314	Lactic acid, beryllium salt	64059-26-3	Contains (regardless of intentional or impurities)	chemical products
13315	Antimonate(2-), bis[mu-[2,3-dihydroxybutanedioate(4-)-O1,02,03,04]]di-, dipotassium, stereoisomer	64070-10-6	Contains (regardless of intentional or impurities)	chemical products
13316	Antimonate(2-), bis[mu-[2,3-dihydroxybutanedioate(4-)-O1,02,03,04]]di-, dipotassium, stereoisomer	64070-11-7	Intentional addition / 1,000ppm	chemical products
13317	Antimonate(2-), bis[mu-[2,3-dihydroxybutanedioate(4-)-O1,02,03,04]]di-, dipotassium, stereoisomer	64070-12-8	Intentional addition / 1,000ppm	chemical products
13318	o-Arsinide antimony tartrate	64070-14-0	Contains (regardless of intentional or impurities)	chemical products
13319	Arsenic(V) acid, trisodium salt, heptahydrate (1:3:7)	64070-83-3	Contains (regardless of intentional or impurities)	chemical products
13320	Lithium ferrosilicon	64082-35-5	Contains (regardless of intentional or impurities)	chemical products
13321	Antimony telluride (Sb2Te5)	64093-53-4	Contains (regardless of intentional or impurities)	chemical products
13322	Neochromium	64093-79-4	Intentional addition / 1,000ppm	chemical products
13323	2-Fluoro-5-methyl benzonitrile	64113-84-4	Intentional addition	chemical products
13324	Ferrate(2-), difluorophosphato(3-)-O-, sodium hydrogen	64147-48-4	Intentional addition / 1%	chemical products
13325	1-Propene, 1,1,2,3,3,3-hexafluoro-, polymer with chlorotrifluoroethene and tetrafluoroethene	64155-70-0	Intentional addition / 1,000ppm	chemical products
13326	Rhodate(3-), hexakis(nitro-N)-, diammonium sodium, (OC-6-11)-	64164-17-6	Contains (regardless of intentional or impurities)	chemical products
13327	1-Bromo-2,6-difluorobenzene	64248-56-2	Intentional addition / 1,000ppm	chemical products
13328	3,4-Difluorobenzonitrile	64248-62-0	Intentional addition	chemical products
13329	3,5-Difluorobenzonitrile	64248-63-1	Intentional addition	chemical products
13330	2,5-Difluorobenzonitrile	64248-64-2	Intentional addition	chemical products
13331	1-Azidinepropanoic acid, 2-methyl-, 2-ethyl-2-[[3-(2-methyl-1-aziridinyl)-1-oxopropyl]methyl]-1,3-propanediyl ester	64265-57-2	Contains (regardless of intentional or impurities)	chemical products
13332	5-Decene, 1-bromo-, (Z)-	64275-63-4	Intentional addition / 1,000ppm	chemical products
13333	5-Decene, 1-bromo-, (E)-	64275-66-7	Intentional addition / 1,000ppm	chemical products
13334	1,1,1-Trichloro-2-nitroethane	64326-81-4	Intentional addition / 1%	chemical products
13335	Manganese chloride (MnCl2), monohydrate	64333-01-3	Contains (regardless of intentional or impurities)	chemical products
13336	3(2H)-Isothiazolone, 4,5-dichloro-2-octyl-	64359-81-5	Intentional addition / 100ppm	chemical products
13337	Resin acids and rosin acids, hydrogenated, esters with pentaerythritol	64365-17-9	Intentional addition / 100ppm	chemical products
13338	Tetraammineplatinum difluoride	64367-82-4	Contains (regardless of intentional or impurities)	chemical products
13339	3-Amino-4-chloro-N-(2-cyanoethyl)benzenesulphonamide	64415-13-0	Intentional addition	chemical products
13340	Yttrium zirconium oxide	64417-98-7	Contains (regardless of intentional or impurities)	chemical products
13341	Alcohols, C13-15, ethoxylated	64425-86-1	Intentional addition / 1%	chemical products
13342	Disperse Red 221	64426-35-3	Intentional addition / 1,000ppm	chemical products
13343	Bisdimethylidithiocarbamoyl-ethylenebis-dithiocarbamic acid zinc salt	64440-88-6	Intentional addition / 1%	chemical products
13344	1,2,3,6,7,9-Hexachlorodibenzo-p-dioxin	64461-98-9	Intentional addition / 1,000ppm	chemical products
13345	Mineral spirits	64475-85-0	Intentional addition / 1,000ppm	chemical products
13346	Antimony arsenic oxide	64475-90-7	Contains (regardless of intentional or impurities)	chemical products
13347	Hydrogen [metasilicato(2-)-O]-(2-methoxyethyl)mercurate(1-)	64481-82-5	Contains (regardless of intentional or impurities)	chemical products
13348	Dibenzob,e(1,4)dioxin, dichloro-	64500-00-4	Intentional addition / 1,000ppm	chemical products
13349	Malybdenum, bis(dipropylcarbamodithioato-S,S')(dithio)oxo-, (PB-7-23-1122)-	64525-54-8	Intentional addition / 1%	chemical products
13350	Allyldibutyltin chloride	64545-05-9	Contains (regardless of intentional or impurities)	chemical products
13351	Manganese, 4-[[4-chloro-3-sulfonylphenyl]azo]-3-hydroxy-2-naphthalenecarboxylate(2-)-	64552-28-9	Contains (regardless of intentional or impurities)	chemical products
13352	Decane, trichloro-	64554-71-8	Intentional addition / 1,000ppm	chemical products
13353	Samarium, compound with zirconium (2:1)	64554-82-1	Contains (regardless of intentional or impurities)	chemical products
13354	Chromate(1-), bis[2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-sodium	64560-69-6	Contains (regardless of intentional or impurities)	chemical products
13355	Chromate(1-), bis[4-[[5-chloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-sodium	64560-71-0	Contains (regardless of intentional or impurities)	chemical products
13356	Cuprate(4-), [mu-[3,3'-(3,3'-dihydroxy(1,1'-biphenyl)-4,4'-diyl)bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulfonato]](8-)]tetrakis[2,2'-iminobis[ethano]]N]di-, tetrahydrogen	64567-64-2	Intentional addition / 1,000ppm	chemical products
13357	Nickel alloy, base, Ni 50Zr 50	64568-51-0	Contains (regardless of intentional or impurities)	chemical products
13358	4-Iodo-2,5-dimethoxyphenylamine hydrochloride	64584-32-3	Intentional addition / 1,000ppm	chemical products
13359	1-(4-Fluorophenyl)propan-2-amine hydrochloride (1:1)	64609-06-9	Intentional addition	chemical products
13360	Ferrate(2-), [4-[[2,4-dihydroxy-5-[[2-hydroxy-4,6-dinitrophenyl]azo]phenyl]azo]-5-hydroxy-2,7-naphthalenedisulfonato(4-)]-, disodium	64611-69-4	Intentional addition / 1%	chemical products
13361	Chromate(2-), [2-[[[2-hydroxyethyl]imino]methyl]phenolato(2-)-N,O,O']6-hydroxy-5-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthalenesulfonato(3-)]-, disodium	64611-70-7	Contains (regardless of intentional or impurities)	chemical products
13362	Cobaltate(1-), bis[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, sodium	64611-71-8	Intentional addition / 1,000ppm	chemical products
13363	Chromate(3-), [2-[[[5-(2-chloro-5-sulfonylphenyl)azo]-2-hydroxyphenyl]methylene]amino]benzoato(3-)](2-hydroxy-3-[[2-hydroxyphenyl]methylene]amino)-5-nitrobenzenesulfonato(3-)]-, trisodium	64611-72-9	Contains (regardless of intentional or impurities)	chemical products
13364	Chromate(1-), bis[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, sodium	64611-73-0	Contains (regardless of intentional or impurities)	chemical products
13365	Boric acid (H3BO3), compound with 2,2'-iminobis[ethano] (1:1)	64612-24-4	Intentional addition / 1%	chemical products
13366	Cuprate(4-), [5-(acetylamino)-4-hydroxy-3-[[5-hydroxy-6-[[2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-7-sulfo-2-naphthalenyl]azo]-2,7-naphthalenedisulfonato(6-)]-, tetrahydrogen	64659-59-2	Intentional addition / 1,000ppm	chemical products
13367	Cuprate(2-), [7-amino-4-hydroxy-3-[[2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2-naphthalenesulfonato(4-)]-, dihydrogen	64659-60-5	Intentional addition / 1,000ppm	chemical products
13368	Strychnidin-10-one, (-)-9,10-dihydro-9,10-ethenoanthracene-1,5-dicarboxylate	64666-35-9	Contains (regardless of intentional or impurities)	chemical products
13369	1,2-Dichloro-2-[[[2,3-dihydroxypropyl]hydroxyphosphinyloxy]trietylmethylammonium]cadmium	64681-08-9	Contains (regardless of intentional or impurities)	chemical products
13370	1,2-Dibromo-4,5-difluorobenzene	64695-78-9	Intentional addition / 1,000ppm	chemical products
13371	[2,3-bis[[2-hydroxyphenyl]methylene]amino]but-2-enedinitrilo(2-)-N2,N3,O2,3]nickel	64696-98-6	Contains (regardless of intentional or impurities)	chemical products
13372	Propane, 1,1-dichloro-1,3,3,3-tetrafluoro-	64712-27-2	Contains (regardless of intentional or impurities)	chemical products
13373	Oils, tallow, barium salts	64741-36-2	Intentional addition / 1,000ppm	chemical products
13374	Naphtha, petroleum, heavy straight-run	64741-41-9	Contains (regardless of intentional or impurities)	chemical products
13375	Naphtha, petroleum, full-range straight-run	64741-42-0	Contains (regardless of intentional or impurities)	chemical products
13376	Distillates, petroleum, straight-run middle	64741-44-2	Intentional addition / 1%	chemical products
13377	Residues, petroleum, atmospheric tower	64741-45-3	Contains (regardless of intentional or impurities)	chemical products
13378	Naphtha, petroleum, light straight-run	64741-46-4	Contains (regardless of intentional or impurities)	chemical products
13379	Natural gas condensates, petroleum	64741-47-5	Contains (regardless of intentional or impurities)	chemical products
13380	Natural gas, petroleum, raw liquid mix	64741-48-6	Contains (regardless of intentional or impurities)	chemical products
13381	Condensates, petroleum, vacuum tower	64741-49-7	Intentional addition / 1,000ppm	chemical products
13382	Distillates, petroleum, light paraffinic	64741-50-0	Contains (regardless of intentional or impurities)	chemical products
13383	Distillates, petroleum, heavy paraffinic	64741-51-1	Contains (regardless of intentional or impurities)	chemical products
13384	Distillates, petroleum, light naphthenic	64741-52-2	Contains (regardless of intentional or impurities)	chemical products
13385	Distillates, petroleum, heavy naphthenic	64741-53-3	Contains (regardless of intentional or impurities)	chemical products
13386	Naphtha, petroleum, heavy catalytic cracked	64741-54-4	Contains (regardless of intentional or impurities)	chemical products
13387	Naphtha, petroleum, light catalytic cracked	64741-55-5	Contains (regardless of intentional or impurities)	chemical products
13388	Gas oils, petroleum, heavy vacuum	64741-57-7	Contains (regardless of intentional or impurities)	chemical products
13389	Distillates, petroleum, light catalytic cracked	64741-59-9	Contains (regardless of intentional or impurities)	chemical products
13390	Distillates, petroleum, intermediate catalytic cracked	64741-60-2	Contains (regardless of intentional or impurities)	chemical products
13391	Distillates, petroleum, heavy catalytic cracked	64741-61-3	Contains (regardless of intentional or impurities)	chemical products
13392	Clarified oils, petroleum, catalytic cracked	64741-62-4	Contains (regardless of intentional or impurities)	chemical products
13393	Naphtha, petroleum, light catalytic reformed	64741-63-5	Contains (regardless of intentional or impurities)	chemical products
13394	Naphtha, petroleum, full-range alkylate	64741-64-6	Contains (regardless of intentional or impurities)	chemical products
13395	Naphtha, petroleum, heavy alkylate	64741-65-7	Contains (regardless of intentional or impurities)	chemical products
13396	Naphtha, petroleum, light alkylate	64741-66-8	Contains (regardless of intentional or impurities)	chemical products
13397	Residues, petroleum, catalytic reformer fractionator	64741-67-9	Contains (regardless of intentional or impurities)	chemical products
13398	Naphtha, petroleum, heavy catalytic reformed	64741-68-0	Contains (regardless of intentional or impurities)	chemical products
13399	Naphtha, petroleum, light hydrocracked	64741-69-1	Contains (regardless of intentional or impurities)	chemical products
13400	Naphtha, petroleum, isomerization	64741-70-4	Contains (regardless of intentional or impurities)	chemical products
13401	Naphtha, petroleum, light thermal cracked	64741-74-8	Contains (regardless of intentional or impurities)	chemical products
13402	Residues, petroleum, hydrocracked	64741-75-9	Contains (regardless of intentional or impurities)	chemical products
13403	Distillates, petroleum, heavy hydrocracked	64741-76-0	Contains (regardless of intentional or impurities)	chemical products
13404	Naphtha, petroleum, heavy hydrocracked	64741-78-2	Contains (regardless of intentional or impurities)	chemical products
13405	Residues, petroleum, thermal cracked	64741-80-6	Contains (regardless of intentional or impurities)	chemical products
13406	Distillates, petroleum, heavy thermal cracked	64741-81-7	Contains (regardless of intentional or impurities)	chemical products
13407	Distillates, petroleum, light thermal cracked	64741-82-8	Contains (regardless of intentional or impurities)	chemical products
13408	Naphtha, petroleum, heavy thermal cracked	64741-83-9	Contains (regardless of intentional or impurities)	chemical products
13409	Naphtha, petroleum, solvent-refined light	64741-84-0	Contains (regardless of intentional or impurities)	chemical products
13410	Distillates, petroleum, sweetened middle	64741-86-2	Contains (regardless of intentional or impurities)	chemical products
13411	Naphtha, petroleum, sweetened	64741-87-3	Contains (regardless of intentional or impurities)	chemical products
13412	Distillates, petroleum, solvent-refined heavy paraffinic	64741-88-4	Contains (regardless of intentional or impurities)	chemical products
13413	Distillates, petroleum, solvent-refined light paraffinic	64741-89-5	Contains (regardless of intentional or impurities)	chemical products
13414	Gas oils, petroleum, solvent-refined	64741-90-8	Contains (regardless of intentional or impurities)	chemical products
13415	Distillates, petroleum, solvent-refined middle	64741-91-9	Contains (regardless of intentional or impurities)	chemical products
13416	Naphtha, petroleum, solvent-refined heavy	64741-92-0	Contains (regardless of intentional or impurities)	chemical products
13417	Residual oils, petroleum, solvent desalinated	64741-95-3	Contains (regardless of intentional or impurities)	chemical products
13418	Distillates, petroleum, solvent-refined heavy naphthenic	64741-96-4	Contains (regardless of intentional or impurities)	chemical products
13419	Distillates, petroleum, solvent-refined light naphthenic	64741-97-5	Contains (regardless of intentional or impurities)	chemical products
13420	Residual oils, petroleum, solvent-refined	64742-01-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
13421	Extracts, petroleum, light naphthenic distillate solvent	64742-03-6	Contains (regardless of intentional or impurities)	chemical products
13422	Extracts, petroleum, heavy paraffinic distillate solvent	64742-04-7	Contains (regardless of intentional or impurities)	chemical products
13423	Extracts, petroleum, light paraffinic distillate solvent	64742-05-8	Contains (regardless of intentional or impurities)	chemical products
13424	Extracts, petroleum, residual oil solvent	64742-10-5	Intentional addition / 1,000ppm	chemical products
13425	Extracts, petroleum, heavy naphthenic distillate solvent	64742-11-6	Contains (regardless of intentional or impurities)	chemical products
13426	Gas oils, petroleum, acid-treated	64742-12-7	Contains (regardless of intentional or impurities)	chemical products
13427	Distillates, petroleum, acid-treated middle	64742-13-8	Contains (regardless of intentional or impurities)	chemical products
13428	Distillates, petroleum, acid-treated light	64742-14-9	Contains (regardless of intentional or impurities)	chemical products
13429	Naphtha, petroleum, acid-treated	64742-15-0	Contains (regardless of intentional or impurities)	chemical products
13430	Residual oils (petroleum), acid-treated	64742-17-2	Intentional addition / 1,000ppm	chemical products
13431	Distillates, petroleum, acid-treated heavy naphthenic	64742-18-3	Contains (regardless of intentional or impurities)	chemical products
13432	Distillates, petroleum, acid-treated light naphthenic	64742-19-4	Contains (regardless of intentional or impurities)	chemical products
13433	Distillates, petroleum, acid-treated heavy paraffinic	64742-20-7	Contains (regardless of intentional or impurities)	chemical products
13434	Distillates, petroleum, acid-treated light paraffinic	64742-21-8	Contains (regardless of intentional or impurities)	chemical products
13435	Naphtha, petroleum, chemically neutralized heavy	64742-22-9	Contains (regardless of intentional or impurities)	chemical products
13436	Naphtha, petroleum, chemically neutralized light	64742-23-0	Contains (regardless of intentional or impurities)	chemical products
13437	Distillates, petroleum, chemically neutralized heavy paraffinic	64742-27-4	Contains (regardless of intentional or impurities)	chemical products
13438	Distillates, petroleum, chemically neutralized light paraffinic	64742-28-5	Contains (regardless of intentional or impurities)	chemical products
13439	Gas oils, petroleum, chemically neutralized	64742-29-6	Contains (regardless of intentional or impurities)	chemical products
13440	Distillates, petroleum, chemically neutralized middle	64742-30-9	Contains (regardless of intentional or impurities)	chemical products
13441	Distillates, petroleum, chemically neutralized heavy naphthenic	64742-34-3	Contains (regardless of intentional or impurities)	chemical products
13442	Distillates, petroleum, chemically neutralized light naphthenic	64742-35-4	Contains (regardless of intentional or impurities)	chemical products
13443	Distillates, petroleum, clay-treated heavy paraffinic	64742-36-5	Contains (regardless of intentional or impurities)	chemical products
13444	Distillates, petroleum, clay-treated light paraffinic	64742-37-6	Contains (regardless of intentional or impurities)	chemical products
13445	Distillates, petroleum, clay-treated middle	64742-38-7	Contains (regardless of intentional or impurities)	chemical products
13446	Residual oils, petroleum, clay-treated	64742-41-2	Contains (regardless of intentional or impurities)	chemical products
13447	Distillates, petroleum, clay-treated heavy naphthenic	64742-44-5	Contains (regardless of intentional or impurities)	chemical products
13448	Distillates, petroleum, clay-treated light naphthenic	64742-45-6	Contains (regardless of intentional or impurities)	chemical products
13449	Distillates, petroleum, hydrotreated middle	64742-46-7	Contains (regardless of intentional or impurities)	chemical products
13450	Petroleum distillates, hydrotreated light	64742-47-8	Contains (regardless of intentional or impurities)	chemical products
13451	Naphtha, petroleum, hydrotreated heavy	64742-48-9	Contains (regardless of intentional or impurities)	chemical products
13452	Naphtha, petroleum, hydrotreated light	64742-49-0	Contains (regardless of intentional or impurities)	chemical products
13453	Distillates, petroleum, hydrotreated heavy naphthenic	64742-52-5	Contains (regardless of intentional or impurities)	chemical products
13454	Distillates, petroleum, hydrotreated light naphthenic	64742-53-6	Contains (regardless of intentional or impurities)	chemical products
13455	Distillates, petroleum, hydrotreated heavy paraffinic	64742-54-7	Contains (regardless of intentional or impurities)	chemical products
13456	Distillates, petroleum, hydrotreated light paraffinic	64742-55-8	Contains (regardless of intentional or impurities)	chemical products
13457	Distillates, petroleum, solvent-dewaxed light paraffinic	64742-56-9	Contains (regardless of intentional or impurities)	chemical products
13458	Residual oils, petroleum, hydrotreated	64742-57-0	Contains (regardless of intentional or impurities)	chemical products
13459	Gas oils, petroleum, hydrotreated vacuum	64742-59-2	Contains (regardless of intentional or impurities)	chemical products
13460	Slack wax, petroleum	64742-61-6	Contains (regardless of intentional or impurities)	chemical products
13461	Residual oils, petroleum, solvent-dewaxed	64742-62-7	Contains (regardless of intentional or impurities)	chemical products
13462	Distillates, petroleum, solvent-dewaxed heavy naphthenic	64742-63-8	Contains (regardless of intentional or impurities)	chemical products
13463	Distillates, petroleum, solvent-dewaxed light naphthenic	64742-64-9	Contains (regardless of intentional or impurities)	chemical products
13464	Distillates, petroleum, solvent-dewaxed heavy paraffinic	64742-65-0	Contains (regardless of intentional or impurities)	chemical products
13465	Naphtha (petroleum), catalytic dewaxed	64742-66-1	Contains (regardless of intentional or impurities)	chemical products
13466	Foots oil, petroleum	64742-67-2	Contains (regardless of intentional or impurities)	chemical products
13467	Naphthenic oils, petroleum, catalytic dewaxed heavy	64742-68-3	Contains (regardless of intentional or impurities)	chemical products
13468	Naphthenic oils, petroleum, catalytic dewaxed light	64742-69-4	Contains (regardless of intentional or impurities)	chemical products
13469	Paraffin oils, petroleum, catalytic dewaxed heavy	64742-70-7	Contains (regardless of intentional or impurities)	chemical products
13470	Paraffin oils, petroleum, catalytic dewaxed light	64742-71-8	Contains (regardless of intentional or impurities)	chemical products
13471	Naphtha, petroleum, hydrodesulfurized light	64742-73-0	Contains (regardless of intentional or impurities)	chemical products
13472	Naphthenic oils, petroleum, complex dewaxed heavy	64742-75-2	Contains (regardless of intentional or impurities)	chemical products
13473	Naphthenic oils, petroleum, complex dewaxed light	64742-76-3	Contains (regardless of intentional or impurities)	chemical products
13474	Residues, petroleum, hydrodesulfurized atmospheric tower	64742-78-5	Contains (regardless of intentional or impurities)	chemical products
13475	Gas oils, petroleum, hydrodesulfurized	64742-79-6	Contains (regardless of intentional or impurities)	chemical products
13476	Distillates, petroleum, hydrodesulfurized middle	64742-80-9	Contains (regardless of intentional or impurities)	chemical products
13477	Kerosine, petroleum, hydrodesulfurized	64742-81-0	Contains (regardless of intentional or impurities)	chemical products
13478	Naphtha, petroleum, hydrodesulfurized heavy	64742-82-1	Contains (regardless of intentional or impurities)	chemical products
13479	Naphtha, petroleum, light steam-cracked	64742-83-2	Contains (regardless of intentional or impurities)	chemical products
13480	Gas oils, petroleum, hydrodesulfurized heavy vacuum	64742-86-5	Contains (regardless of intentional or impurities)	chemical products
13481	Solvent naphtha, petroleum, medium aliphatic	64742-88-7	Contains (regardless of intentional or impurities)	chemical products
13482	Solvent naphtha, petroleum, light aliphatic	64742-89-8	Contains (regardless of intentional or impurities)	chemical products
13483	Residues, petroleum, steam-cracked	64742-90-1	Contains (regardless of intentional or impurities)	chemical products
13484	Asphalt, oxidized	64742-93-4	Intentional addition / 1,000ppm	chemical products
13485	Solvent naphtha, petroleum, light aromatic	64742-95-6	Contains (regardless of intentional or impurities)	chemical products
13486	Petrolatum, petroleum, oxidized	64743-01-7	Contains (regardless of intentional or impurities)	chemical products
13487	Benzoic acid, 5-[[4-[[2,6-diamino-3-methyl-5-[[4-sulphophenyl]azo]phenyl]azo]-3,3'-dimethyl[1,1'-biphenyl]-4-yl]azo]-2-hydroxy-, disodium salt	64743-15-3	Intentional addition / 100ppm	chemical products
13488	Fatty acids, coco, barium salts	64754-96-7	Intentional addition / 1,000ppm	chemical products
13489	Fatty acids, tallow, barium salts	64755-00-6	Intentional addition / 1,000ppm	chemical products
13490	Paraffins, petroleum, normal C>10	64771-71-7	Intentional addition / 1,000ppm	chemical products
13491	Poly(oxy-1,2-ethanediyl), alpha-(dinonylphenyl)-omega-hydroxy-, phosphate, barium salt	64771-73-9	Contains (regardless of intentional or impurities)	chemical products
13492	5-Hexen-1-ol mesylate	64818-36-6	Contains (regardless of intentional or impurities)	chemical products
13493	Poly(oxy(methyl-1,2-ethanediyl), alpha, alpha, alpha, -1,2,3-propanetriyltris(omega-(2-aminomethylethoxy)-	64852-22-8	Intentional addition / 1,000ppm	chemical products
13494	Copper(2+), bis(1,2-ethanediamine-N,N)-, salt with dodecylbenzenesulfonic acid (1:2)	64883-30-3	Intentional addition / 1,000ppm	chemical products
13495	Benzenediazonium, 3-chloro-4-(dimethylamino)-, tetrafluoroborate(1-)	64909-33-7	Intentional addition / 1%	chemical products
13496	Triisooctyl 3,3',3''-[[dodecylstannylidene]tris(thio)]tripropionate	64926-50-7	Contains (regardless of intentional or impurities)	chemical products
13497	Octane, 1,3,7-trichloro-3,7-dimethyl-	64961-16-6	Intentional addition / 1,000ppm	chemical products
13498	3,3'-Dichlorobenzidine dihydrogen bis(sulphate)	64969-34-2	Contains (regardless of intentional or impurities)	chemical products
13499	[3,3'-Dimethyl[1,1'-biphenyl]-4,4'-diyl]diammonium bis(hydrogen sulphate)	64969-36-4	Contains (regardless of intentional or impurities)	chemical products
13500	Arsenic bromide	64973-06-4	Contains (regardless of intentional or impurities)	chemical products
13501	Glycidyl butyrate	65031-96-1	Contains (regardless of intentional or impurities)	chemical products
13502	Molybdate (MoO <sub>4</sub> <sup>2-</sup> ), tetrahydrogen, compound with 1,3,5-triazine-2,4,6-triamine (1:4)	65036-95-5	Contains (regardless of intentional or impurities)	chemical products
13503	2,3-Epoxypropyl propionate	65045-26-3	Contains (regardless of intentional or impurities)	chemical products
13504	Cuprate(2-), bis[[2-(2-hydroxy-3-[[4-methoxyphenyl]amino]carbonyl]-1-naphthalenyl]azo]-4-nitrobenzoate(2-)]-, dihydrogen	65104-05-4	Intentional addition / 1,000ppm	chemical products
13505	Copper, [N,N'-bis(2-cyanoethyl)-N,N,N',N'-tetrakis[[2-[[2-(2-cyanoethylamino)ethyl]-29H,31H-phthalocyanine-C,C,C,C-tetrasulfonamidato(2-)-N <sub>29</sub> N <sub>30</sub> N <sub>31</sub> N <sub>32</sub> ]-	65105-03-5	Intentional addition / 1,000ppm	chemical products
13506	Diarсениc trisulfide	65113-28-2	Contains (regardless of intentional or impurities)	chemical products
13507	Cuprate(4-), [mu-[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis(5-amino-4-hydroxy-2,7-naphthalenedisulfonato)](8-)]di-, tetrahydrogen, compound with morpholine (1:4)	65121-91-7	Intentional addition / 1,000ppm	chemical products
13508	Tetrakis(pentane-2,4-dionato-O,O')uranium	65137-03-3	Contains (regardless of intentional or impurities)	chemical products
13509	Cuprate(1-), [2-(29H,31H-phthalocyanine)carboxyl]benzoate(3-)-N <sub>29</sub> N <sub>30</sub> N <sub>31</sub> N <sub>32</sub> ]-, hydrogen	65138-80-9	Intentional addition / 1,000ppm	chemical products
13510	Tetrasodium [decachloro-29H,31H-phthalocyaninetetra-sulphonato(6-)-N <sub>29</sub> N <sub>30</sub> N <sub>31</sub> N <sub>32</sub> ]cuprate(4-)	65138-81-0	Intentional addition / 1,000ppm	chemical products
13511	Tetrasodium [dodecachloro-29H,31H-phthalocyaninetetra-sulphonato(6-)-N <sub>29</sub> N <sub>30</sub> N <sub>31</sub> N <sub>32</sub> ]cuprate(4-)	65138-82-1	Intentional addition / 1,000ppm	chemical products
13512	Tetrasodium [undecachloro-29H,31H-phthalocyaninetetra-sulphonato(6-)-N <sub>29</sub> N <sub>30</sub> N <sub>31</sub> N <sub>32</sub> ]cuprate(4-)	65138-83-2	Intentional addition / 1,000ppm	chemical products
13513	Cuprate(1-), [2-[(chloro-29H,31H-phthalocyanine)carboxyl]benzoate(3-)-N <sub>29</sub> N <sub>30</sub> N <sub>31</sub> N <sub>32</sub> ]-, hydrogen	65150-84-7	Intentional addition / 1,000ppm	chemical products
13514	Plumbane, tetrakis(1-methylpropyl)-	65151-08-8	Contains (regardless of intentional or impurities)	chemical products
13515	2,7-Naphthalenedisulfonic acid, 4,4'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis(3-hydroxy-, tetrasodium salt	65151-33-9	Intentional addition	chemical products
13516	Cuprate(1-), [29H,31H-phthalocyanine-C-sulfonato(3-)-N <sub>29</sub> N <sub>30</sub> N <sub>31</sub> N <sub>32</sub> ]-, aluminum (3:1)	65168-06-1	Intentional addition / 1,000ppm	chemical products
13517	Abamectin B1a	65195-55-3	Contains (regardless of intentional or impurities)	chemical products
13518	Abamectin B1b	65195-56-4	Intentional addition / 1.8%	chemical products
13519	Nickel boron phosphide	65229-23-4	Contains (regardless of intentional or impurities)	chemical products
13520	Chromium, pentahydroxy(tetradecanoato)di-	65229-24-5	Intentional addition / 1,000ppm	chemical products
13521	Vanadium hydroxide oxide phosphate	65232-89-5	Contains (regardless of intentional or impurities)	chemical products
13522	Molybdate (MoO <sub>4</sub> <sup>2-</sup> ), dihydrogen, compound with 1,3,5-triazine-2,4,6-triamine (1:1)	65235-34-9	Contains (regardless of intentional or impurities)	chemical products
13523	Benzoic acid, 3,5-bis(1,1-dimethylethyl)-2-hydroxy-, nickel(2+) salt (2:1)	65272-92-6	Contains (regardless of intentional or impurities)	chemical products
13524	Chromate(3-), bis[5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(3-)]-, trihydrogen	65277-39-6	Contains (regardless of intentional or impurities)	chemical products
13525	Ketoconazole	65277-42-1	Contains (regardless of intentional or impurities)	chemical products
13526	Butanedioic acid, 2,2,2'-[[[butylstannylidene]tris(thio)]tris-, hexabutyl ester	65291-39-6	Contains (regardless of intentional or impurities)	chemical products
13527	Propane, bromofluoro-	65291-92-1	Intentional addition / 1,000ppm	chemical products
13528	Pyridinium, 1,1'-[[1,6-hexanediy]bis[imino(6-oxo-6,1-hexanedyl)]bis-, diperchlorate	65294-05-5	Intentional addition / 1,000ppm	chemical products
13529	Quinolinium, 1-butyl-4-[[3-(3-ethyl-2(3H)-benzoxazolenzalylidene)-1-propenyl]-, iodide	65294-08-8	Contains (regardless of intentional or impurities)	chemical products
13530	Dodecyl 4,4-didodecyl-7-oxo-8-oxa-3,5-dithia-4-stannaosanoate	65301-38-4	Contains (regardless of intentional or impurities)	chemical products
13531	8,11-Dioxo-3,5,14,16-tetra-thia-4,15-distannaoctadecanedioic acid, 4,4,15,15-tetrabutyl-7,12-dioxo-, diisooctyl ester	65308-00-1	Contains (regardless of intentional or impurities)	chemical products
13532	1,3-Benzenediamine, 4-methyl-, sulfate (1:1)	65321-67-7	Contains (regardless of intentional or impurities)	chemical products
13533	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, copper(2+) sodium salt (1:1:2)	65330-59-8	Intentional addition / 1,000ppm	chemical products
13534	Heptahydrogen bis[4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]]-7-[[3-(phosphonophenyl)amino]naphthalene-2-sulphonato(5-)]cobaltate(7-)	65335-15-1	Intentional addition / 1,000ppm	chemical products
13535	cis-Tetracarboxylbis(piperidine)molybdenum	65337-26-0	Intentional addition / 1%	chemical products
13536	Strychnidin-10-one, (R)-3,3'-dimethyl[1,1'-binaphthalene]-2,2'-diylbis(dihydrogen phosphate)	65337-82-8	Contains (regardless of intentional or impurities)	chemical products
13537	Strychnidin-10-one, compound with (R)-3,3'-dimethyl[1,1'-binaphthalene]-2,2'-diol	65355-10-2	Contains (regardless of intentional or impurities)	chemical products
13538	Xanthylum, 9-[[2-(ethoxycarbonyl)phenyl]-3,6-bis(ethylamino)-2,7-dimethyl-, (T-4)-tetraoxomolybdate(2-)-10	65366-87-2	Contains (regardless of intentional or impurities)	chemical products
13539	[mu-[[Carbonato(2-)-O,O']]dihydroxydinickel	65405-96-1	Contains (regardless of intentional or impurities)	chemical products
13540	Benzenepropanol, beta-methyl-4-(1-methylethyl)-, triester with boric acid (H3BO3)	65416-31-1	Intentional addition / 1%	chemical products
13541	2-Propen-1-ol, 3-[4-(1,1-dimethylethyl)phenyl]-2-methyl-, triester with boric acid (H3BO3)	65416-32-2	Intentional addition / 1%	chemical products
13542	2,6-Octadecan-1-ol, 3,7-dimethyl-, triester with boric acid (H3BO3), (2E,2'E,2'E)-	65416-33-3	Intentional addition / 1%	chemical products
13543	Cobalt arsenide	65453-05-6	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
13544	Decaethylene glycol, isononylphenyl ether	65455-72-3	Intentional addition / 1,000ppm	chemical products
13545	Sulfuric acid, cobalt salt, hydrate	65492-00-4	Intentional addition / 1,000ppm	chemical products
13546	Chromate(1-), bis[[7.8.9.10.11-eta]-1,2,3,4,5,6,9,10,11-nonahydro-7,8-dimethyl-7,8-dicarbaundecaborate(2)-]]	65504-45-2	Contains (regardless of intentional or impurities)	chemical products
13547	Hexadecane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,10,10,11,12,12,13,13,14,14-nonacosafuoro-16-iodo-	65510-55-6	Contains (regardless of intentional or impurities)	chemical products
13548	Undecane, 1,1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9-nonadecafluoro-11-iodo-	65510-56-7	Contains (regardless of intentional or impurities)	chemical products
13549	Aluminum, bis(2,2-dimethylpropyl)hydro-	65514-51-4	Intentional addition / 1,000ppm	chemical products
13550	Dibutyltin dicarboxylate	65540-76-3	Contains (regardless of intentional or impurities)	chemical products
13551	Phosphonothioic acid, phenyl-, O-ethyl O-(4-nitrophenyl) ester, (R)-	65580-79-2	Intentional addition / 1,000ppm	chemical products
13552	Phosphonothioic acid, phenyl-, O-ethyl O-(4-nitrophenyl) ester, (S)-	65580-80-5	Intentional addition / 1,000ppm	chemical products
13553	Dibutoxy(ethyl 3-oxobutyrato-O1, O3)aluminum	65583-10-0	Intentional addition / 1,000ppm	chemical products
13554	Tantalum magnesium oxide	65607-95-6	Intentional addition / 1,000ppm	chemical products
13555	Chromate(5-), [6-(acetylamino)-4-hydroxy-3-[[2-hydroxy-3-nitro-5-sulfonyl]azo]-2-naphthalenesulfonato(4-)]-[4-hydroxy-6-[[2-hydroxy-5-methylphenyl]azo]-3-[[2-hydroxy-3-nitro-5-sulfonyl]azo]-2-naphthalenesulfonato(4-)]-, pentahydrogen	65629-44-9	Contains (regardless of intentional or impurities)	chemical products
13556	Phosphoric acid, bis[[1,1-dimethylthylphenyl]phenyl] ester	65652-41-7	Intentional addition / 1,000ppm	chemical products
13557	Benzene, trichloro(phenyl)methyl-	65652-43-9	Intentional addition / 1,000ppm	chemical products
13558	1H-Imidazole-1-propanenitrile, 4,5-bis[[2-cyanoethoxy]methyl]-2-phenyl-	65652-67-7	Intentional addition	chemical products
13559	Chromate(3-), [4-[[4-(diethylamino)-2-hydroxyphenyl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-[2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfonyl)-1H-pyrazol-4-yl]azo]benzoato(3-)]-, trihydrogen	65664-27-9	Contains (regardless of intentional or impurities)	chemical products
13560	Chromate(5-), bis[4-hydroxy-6-[[2-hydroxy-5-methylphenyl]azo]-3-[[2-hydroxy-3-nitro-5-sulfonyl]azo]-2-naphthalenesulfonato(4-)]-	65718-42-5	Contains (regardless of intentional or impurities)	chemical products
13561	Cuprate(2-), bis[aspartato(2-)-kappa.N,kappa.O]1-, hydrogen (1:2)	65732-10-7	Intentional addition / 1,000ppm	chemical products
13562	Boric acid (H3BO3), manganese(3+) salt (1:1)	65767-17-1	Intentional addition / 1%	chemical products
13563	3-Ethyl-2-[[3-[[3-[[3-ethyl-3H-benzothiazol-2-ylidene]methyl]-5,5-dimethylcyclohex-2-en-1-ylidene]prop-1-enyl]-5,5-dimethylcyclohex-2-en-1-ylidene]methyl]benzothiazolium perchlorate	65767-27-3	Intentional addition / 1,000ppm	chemical products
13564	Naphtho[2,1-d]thiazolium, 3-ethyl-2-[[3-[[3-[[3-ethyl-naphtho[2,1-d]thiazol-2(3H)-ylidene]methyl]-5,5-dimethyl-2-cyclohexen-1-ylidene]-1-propenyl]-5,5-dimethyl-2-cyclohexen-1-ylidene]methyl]-, perchlorate	65767-29-5	Intentional addition / 1,000ppm	chemical products
13565	Pyrylium, 2-methyl-4,6-bis(4-methylphenyl)-, tetrafluoroborate(1-)	65776-60-5	Intentional addition / 1%	chemical products
13566	(Diiodine)bis(pentane-2,4-dionato-O,O')platinum	65849-16-3	Contains (regardless of intentional or impurities)	chemical products
13567	(Dichlorine)bis(pentane-2,4-dionato-O,O')platinum	65849-18-5	Contains (regardless of intentional or impurities)	chemical products
13568	Furathiocarb	65907-30-4	Contains (regardless of intentional or impurities)	chemical products
13569	Copper, [methyl 4-hydroxy-3-[[[2-hydroxy-1-naphthalenyl(methylene)amino]benzoato(2-)-N3,O4]-rhodate(2-), pentachloro-, dipotassium	65929-10-4	Intentional addition / 1,000ppm	chemical products
13570	Rhodate(2-), pentachloro-, dipotassium	65980-75-8	Contains (regardless of intentional or impurities)	chemical products
13571	Rhodate(2-), pentachloro-, diammonium	65980-78-1	Contains (regardless of intentional or impurities)	chemical products
13572	Barium titanium oxide (Ba2Ti5O12)	65982-93-6	Intentional addition	chemical products
13573	Slags, steelmaking	65996-71-6	Contains (regardless of intentional or impurities)	chemical products
13574	Spelter, ferrous metal	65996-76-1	Contains (regardless of intentional or impurities)	chemical products
13575	Light oil, coal, coke-oven	65996-78-3	Contains (regardless of intentional or impurities)	chemical products
13576	Solvent naphtha, coal	65996-79-4	Contains (regardless of intentional or impurities)	chemical products
13577	Tar oils, coal	65996-82-9	Contains (regardless of intentional or impurities)	chemical products
13578	Extracts, coal tar oil alkaline	65996-83-0	Contains (regardless of intentional or impurities)	chemical products
13579	Tar bases, coal, crude	65996-84-1	Contains (regardless of intentional or impurities)	chemical products
13580	Tar acids, coal, crude	65996-85-2	Contains (regardless of intentional or impurities)	chemical products
13581	Extract oils, coal, tar base	65996-86-3	Contains (regardless of intentional or impurities)	chemical products
13582	Extract residues, coal, tar oil alkaline	65996-87-4	Contains (regardless of intentional or impurities)	chemical products
13583	Benzol forerunnings, coal	65996-88-5	Contains (regardless of intentional or impurities)	chemical products
13584	Tar, coal, high-temperature	65996-89-6	Contains (regardless of intentional or impurities)	chemical products
13585	Tar, coal, low-temperature	65996-90-9	Contains (regardless of intentional or impurities)	chemical products
13586	Distillates, coal tar, upper	65996-91-0	Contains (regardless of intentional or impurities)	chemical products
13587	Distillates, coal tar, lower	65996-92-1	Contains (regardless of intentional or impurities)	chemical products
13588	Resin acids and Rosin acids, hydrogenated, esters with glycerol	65997-13-9	Intentional addition / 100ppm	chemical products
13589	Cement, portland, chemicals	65997-15-1	Contains (regardless of intentional or impurities)	chemical products
13590	Frits, chemicals	65997-18-4	Contains (regardless of intentional or impurities)	chemical products
13591	Iodine cyanide (I(CN))	66004-32-8	Contains (regardless of intentional or impurities)	chemical products
13592	Hydrogen bis[methyl 8-[[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthyl]carbamato(2-)]chromate(1-)	66006-52-8	Contains (regardless of intentional or impurities)	chemical products
13593	Chromate(4-), [8-[[2-bromo-1-oxo-2-propenyl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenesulfonato(3-)]-[4-[[[2-bromo-1-oxo-2-propenyl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, tetrasodium	66010-29-5	Contains (regardless of intentional or impurities)	chemical products
13594	Trisodium 3-[[O-arsonatophenyl]azo]-4,5-dihydroxynaphthalene-2,7-disulphonate	66019-20-3	Contains (regardless of intentional or impurities)	chemical products
13595	Sulfamic acid, indium(3+) salt	66027-93-8	Intentional addition / 1%	chemical products
13596	Indium, hydroxybis(trifluoroacetato-O)-	66027-94-9	Intentional addition / 1%	chemical products
13597	Chromate(1-), diamminetetakis(thiocyanato-N-), (OC-6-11)-, hydrogen, compound with strychnidin-10-one (1:1)	66063-57-8	Contains (regardless of intentional or impurities)	chemical products
13598	Strychnidin-10-one, hexaiodotellurate(2-), (2:1)	66083-89-4	Contains (regardless of intentional or impurities)	chemical products
13599	Strychnidin-10-one, mono[(OC-6-11)-bis(benzamide) tetrakis(thiocyanato-N)]chromate(1-)	66083-91-8	Contains (regardless of intentional or impurities)	chemical products
13600	Strychnidin-10-one, mono[bis(4-methylbenzamide)tetrakis(thiocyanato-N)]chromate(1-)	66083-92-9	Contains (regardless of intentional or impurities)	chemical products
13601	Copper, [C,C,C,C,C,C,C,C-octabromo-C,C,C,C,C,C,C,C-octachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-	66085-74-3	Intentional addition / 1,000ppm	chemical products
13602	Beryllium carbonate	66104-24-3	Contains (regardless of intentional or impurities)	chemical products
13603	Barium abietate	66104-41-4	Contains (regardless of intentional or impurities)	chemical products
13604	Cobaltate(1-), bis[2-[[4-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-, sodium	66104-83-4	Intentional addition / 1,000ppm	chemical products
13605	Phosphoric acid, 2,2-bis(bromomethyl)-3-chloropropyl bis[2-chloro-1-(chloromethyl)ethyl] ester	66108-37-0	Intentional addition / 900ppm	chemical products
13606	(19.alpha.,20.alpha.)-3,4,16,17-Tetrahydro-16-(methoxycarbonyl)-19-methylxayohimbanium perchlorate	66113-84-6	Intentional addition / 1,000ppm	chemical products
13607	Benzoselenazolium, 3-ethyl-2-methyl-, ethyl sulfate	66142-22-1	Contains (regardless of intentional or impurities)	chemical products
13608	Chromate(3-), bis[4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, trihydrogen, compound with N-cyclohexylcyclohexanamine (1:2)	66142-95-8	Contains (regardless of intentional or impurities)	chemical products
13609	Cuprate(3-), [29H,31H-phthalocyanine-C,C,C-trisulfonato(5-)-N29,N30,N31,N32]-, trihydrogen, compound with N,N'-bis(methylphenyl)guanidine (1:3)	66142-99-2	Intentional addition / 1,000ppm	chemical products
13610	Bis(triphenyltin) dodecylsulfonate	66161-18-0	Contains (regardless of intentional or impurities)	chemical products
13611	Bis(pentafluorophenyl)nickel(B) toluene complex	66197-14-6	Contains (regardless of intentional or impurities)	chemical products
13612	2,7-Naphthalenedisulfonic acid, 5-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-3-[[4-[[2-hydroxy-3,6-disulfo-1-naphthalenyl]azo]-3,3'-dimethoxy]1,1'-biphenyl]-4-yl]azo]-, tetrasodium salt	66214-47-9	Intentional addition	chemical products
13613	Cuprate(3-), [mu-3-[[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-7-[[[[5-hydroxy-6-[[2-hydroxy-4-sulfonyl]azo]-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-2-naphthalenesulfonato(7-)]]]di-, trisodium	66225-59-0	Intentional addition / 1,000ppm	chemical products
13614	Cuprate(6-), [mu-[[[2,2'-NNO-azobis[[2-sulfo-4,1-phenylene]-2,1-ethenediyl(3-sulfo-4,1-phenylene)azo(1-hydroxy-3-sulfo-7,2-naphthalenediyl)azo]bis[benzoato(10-)]]]]di-, hexahydrogen	66225-60-3	Intentional addition / 1,000ppm	chemical products
13615	Cuprate(4-), [mu-[[[2,2'-[1,2-ethenediylbis(3-sulfo-4,1-phenylene)-ONN-azoxy(1-hydroxy-3-sulfo-7,2-naphthalenediyl)azo]bis[benzoato(8-)]]]]di-, tetrasodium	66225-64-7	Intentional addition / 1,000ppm	chemical products
13616	Cuprate(2-), [5-[[[4-[[2,6-dihydroxy-3-[[2-hydroxy-5-sulfonyl]azo]phenyl]azo]-3,3'-dimethyl[1,1'-biphenyl]-4-yl]azo]-2-hydroxybenzoato(4-)]-, disodium	66225-65-8	Intentional addition / 1,000ppm	chemical products
13617	Esfenvalerate	66230-04-4	Contains (regardless of intentional or impurities)	chemical products
13618	1,1,4-Trichlorobutane	66250-03-1	Intentional addition / 1,000ppm	chemical products
13619	Cuprate(4-), [mu-[[[5-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-[[[4-[[3,6-disulfo-2-hydroxy-1-naphthalenyl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(8-)]]]]di-, tetrasodium	66256-76-6	Intentional addition / 1,000ppm	chemical products
13620	Copper, [[2,2',2'',2'''-[[29H,31H-phthalocyaninepentakis(methylene)pentakis(1H-isoindeole-1,3(2H)-dionato)](2-)-N29,N30,N31,N32]-	66276-83-3	Intentional addition / 1,000ppm	chemical products
13621	Cobalt, tris(1-nitroso-2-naphthalenolato-N1,O2)-, (OC-6-21)-	66288-88-8	Intentional addition / 1%	chemical products
13622	3-Isopropoxy-2-(trifluoromethyl)benzamide	66332-96-5	Intentional addition / 1%	chemical products
13623	Zirconium acrylate	66336-96-7	Contains (regardless of intentional or impurities)	chemical products
13624	Benzenediazonium, 4-(dimethylamino)-2,5-dimethoxy-, tetrafluoroborate(1-)	66337-79-9	Intentional addition / 1%	chemical products
13625	Cuprate(2-), tris(cyano-C)-, disodium, trihydrate	66358-72-3	Intentional addition / 1,000ppm	chemical products
13626	Diammonium selenite monohydrate	66375-26-6	Intentional addition / 1,000ppm	chemical products
13627	Ceramic materials and wares, chemicals	66402-68-4	Contains (regardless of intentional or impurities)	chemical products
13628	Cuprate(3-), [mu-[[[4-[[[6-amino-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-3-hydroxy-2,7-naphthalenedisulfonato(7-)]]]di-, trisodium	66418-17-5	Intentional addition / 1,000ppm	chemical products
13629	Cuprate(4-), [mu-3-[[[3,3'-dihydroxy-4-[[2-hydroxy-3,6-disulfo-1-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(8-)]]]di-, tetrasodium	66418-18-6	Intentional addition / 1,000ppm	chemical products
13630	Ethanol, 2-(2,4-diaminophenoxy)-, dihydrochloride	66422-95-5	Contains (regardless of intentional or impurities)	chemical products
13631	Alcohols, C12-13, ethoxylated	66455-14-9	Intentional addition / 1%	chemical products
13632	Alcohols, C10-14, ethoxylated	66455-15-0	Intentional addition / 1%	chemical products
13633	Sulfonic acids, barium salts	66455-19-4	Intentional addition / 1,000ppm	chemical products
13634	Ammonium selenide	66455-76-3	Contains (regardless of intentional or impurities)	chemical products
13635	Iron boride (Fe4B)	66456-48-2	Intentional addition / 1%	chemical products
13636	Nickel, (2-ethyl-1-hexanamine)[[2,2'-(thio-kappa.S)bis[4-(1,1,3,3-tetramethylbutyl)phenolato-kappa.O]](2)-]]	66467-44-5	Contains (regardless of intentional or impurities)	chemical products
13637	Boric acid, (3-aminophenyl)-, sulfate (2:1)	66472-86-4	Intentional addition / 1%	chemical products
13638	Dibutoxydichlorostannane	66499-05-6	Contains (regardless of intentional or impurities)	chemical products
13639	Manganese, [[1,2-ethanediy]bis(carbamodithioato)](2)-], mixture with aluminum tris(ethylphosphonate) and [[1,2-ethanediy]bis(carbamodithioato)](2)-]zinc	66523-56-6	Contains (regardless of intentional or impurities)	chemical products
13640	4-Methyl-2-oxopentaneitrile	66582-16-9	Contains (regardless of intentional or impurities)	chemical products
13641	Barium molybdenum oxide (BaMoO4O13)	66589-15-9	Intentional addition / 1%	chemical products
13642	Molybdate (Mo7O246-), barium (1:3)	66589-16-0	Intentional addition / 1,000ppm	chemical products
13643	Cyclohexyl(tributylstannyloxy)diazonium 1-oxide	66603-07-4	Contains (regardless of intentional or impurities)	chemical products
13644	Diazene, cyclohexylhydroxy-, 1-oxide, potassium salt	66603-10-9	Intentional addition / 1,000ppm	chemical products
13645	Decane, 1,1,3-trichloro-	66651-36-3	Intentional addition / 1,000ppm	chemical products
13646	1,2-Difluoro-3-methoxy-4-nitrobenzene	66684-60-4	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
13647	4-Chloroisouquinoline-3-amine	66729-00-8	Contains (regardless of intentional or impurities)	chemical products
13648	Uranate(2-), tetrakis(acetato-O)dioxo-, magnesium (1:1), (OC-6-11)-	66735-86-2	Contains (regardless of intentional or impurities)	chemical products
13649	Dimethoxybis(pentane-2,4-dionato-O,O')tin	66779-19-9	Contains (regardless of intentional or impurities)	chemical products
13650	Molybdenum, bis(dibutylcarbamodithioato-S,S')dinitrosyl-, (OC-6-21)-	66793-35-9	Intentional addition / 1%	chemical products
13651	Tralometrin	66841-25-6	Intentional addition / 1%	chemical products
13652	Triocoper chromate dioxide	66860-79-5	Contains (regardless of intentional or impurities)	chemical products
13653	Dibutyl (Z,Z)-6-[[4-butoxy-1,4-dioxobut-2-enyl]oxy]-6-butyl-4,8,11-trioxo-5,7,12-trioxo-6-stannahexadeca-2,9-dienoate	66899-69-2	Contains (regardless of intentional or impurities)	chemical products
13654	Boric acid (H3BO3), calcium salt (2:1), dihydrate	66904-22-1	Intentional addition / 1%	chemical products
13655	Boric acid (H3BO3), calcium salt (2:1), tetrahydrate	66904-23-2	Intentional addition / 1%	chemical products
13656	Barium chloride, (BaCl2), hydrate (2:1)	66905-91-7	Intentional addition / 1,000ppm	chemical products
13657	Chromate(1-), bis(1-butanamine)tetrakis(thiocyanato-N)-, (OC-6-11)-, hydrogen, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	66915-36-4	Contains (regardless of intentional or impurities)	chemical products
13658	Chromate(1-), bis(1-propanamine)tetrakis(thiocyanato-N)-, (OC-6-11)-, hydrogen, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	66915-45-5	Contains (regardless of intentional or impurities)	chemical products
13659	Acetic acid, (isopropylenedinitrito)tetra-, antimony sodium salt, dihydrate	66922-79-0	Contains (regardless of intentional or impurities)	chemical products
13660	Methasulfocarb	66952-49-6	Intentional addition / 1%	chemical products
13661	Bromononane	66989-58-0	Intentional addition / 1,000ppm	chemical products
13662	2-[2-[[5-(6-Dimethoxy-3-(3-sulphonatopropyl)-3H-benzoselenazol-2-ylidene)methyl]but-1-enyl]-3-ethyl-5-methoxybenzoxazolium	67014-91-9	Contains (regardless of intentional or impurities)	chemical products
13663	(90Y) Yttrium citrate	67023-60-3	Intentional addition / 1%	chemical products
13664	1,3,7-Trichlorodibenzo(b,e)(1,4)dioxin	67028-17-5	Intentional addition / 1,000ppm	chemical products
13665	1,2,3,7-Tetrachlorodibenzo(b,e)(1,4)dioxin	67028-18-6	Intentional addition / 1,000ppm	chemical products
13666	1,2,3,4,6-Pentachlorodibenzo(b,e)(1,4)dioxin	67028-19-7	Intentional addition / 1,000ppm	chemical products
13667	5-(2-Carboxy-5-sulfofenyl)-1-[3-[4-fluoro-6-(3-sulfoanilino)-1,3,5-triazine-2-yl amino]-2-hydroxy-5-sulfofenyl]-3-phenyl]formazone copper chelates sodium salt	67028-54-0	Intentional addition / 1,000ppm	chemical products
13668	Strychnidin-10-one, hexachlorotellurate(2-)(1:1)	67028-97-1	Contains (regardless of intentional or impurities)	chemical products
13669	4H-1,3,2-Benzodioxaborin-4-one, 2-hydroxy-	67045-32-3	Intentional addition / 1%	chemical products
13670	Iron, tris(dimethylcarbamodithioato-S,S)-, (OC-6-11)-, mixture with 2(3H)-benzothiazolethione and tetramethylthiopyridylcarbamodithioato-S,S'-diimine ((Me2N/C(S)2)S2)	67055-35-0	Intentional addition / 1%	chemical products
13671	Iron, tris(dimethylcarbamodithioato-S,S)-, (OC-6-11)-, mixture with 2(3H)-benzothiazolethione	67055-36-1	Intentional addition / 1%	chemical products
13672	Tributyl(dimethylthiocarbonyl)thio-stannane	67057-32-3	Contains (regardless of intentional or impurities)	chemical products
13673	Stannane, ((dibutylthiocarbonyl)oxy)tributyl-	67057-34-5	Contains (regardless of intentional or impurities)	chemical products
13674	Tridecane, 1,1,1,3-tetrachloro-	67095-50-5	Intentional addition / 1,000ppm	chemical products
13675	Chromate(1-), bis[2-chloro-4-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-5-hydroxybenzenesulfonamido(2-)]-, sodium	67109-27-7	Contains (regardless of intentional or impurities)	chemical products
13676	Platinate(2-), tetrakis(nitro-N)-, diammonium, (SP-4-1)-	67158-54-7	Contains (regardless of intentional or impurities)	chemical products
13677	1-[(5-Ethoxycarbonyl-2-hydroxyphenyl)iminomethyl]-2-naphtholato-O1.N1.O2]copper	67177-88-2	Intentional addition / 1,000ppm	chemical products
13678	Copper chromium manganese oxide	67181-98-0	Contains (regardless of intentional or impurities)	chemical products
13679	Ethane, thioarseno-	67226-86-2	Intentional addition / 100ppm	chemical products
13680	Malonic acid 4-nitrobenzyl	67245-85-6	Contains (regardless of intentional or impurities)	chemical products
13681	Silicon(1+), tris(2,4-pentanedionato-O,O')-, (OC-6-11)-, (OC-6-11)-hexafluoroantimonate(1-)	67251-37-0	Contains (regardless of intentional or impurities)	chemical products
13682	Silicon(1+), tris(2,4-pentanedionato-O,O')-, (OC-6-11)-, hexafluoroarsenate(1-)	67251-38-1	Contains (regardless of intentional or impurities)	chemical products
13683	Boron(1+), bis(2,4-pentanedionato-O,O')-, (T-4)-, (OC-6-11)-hexafluoroantimonate(1-)	67251-40-5	Contains (regardless of intentional or impurities)	chemical products
13684	Strychnidin-10-one, compound with (S)-4-hydroxy-2,6-dimethylidnaptho[2,1-d':2'-f][1,3,2]dioxaphosphepin 4-oxide (1:1)	67267-34-9	Contains (regardless of intentional or impurities)	chemical products
13685	2-Chloro-3-oxohexanoic acid ethyl ester	67271-32-3	Contains (regardless of intentional or impurities)	chemical products
13686	Sodium hydrotri-sec-butylborate(1-)	67276-04-4	Intentional addition / 1%	chemical products
13687	[1,1-Bis(diphenylphosphino)ferrocene]dichloronickel(II)	67282-34-6	Contains (regardless of intentional or impurities)	chemical products
13688	[1,1-Bis(diphenylphosphino)ferrocene]cobalt(II) dichloride	67282-36-8	Intentional addition / 1%	chemical products
13689	1,2,6,7-Tetrachlorodibenzo(b,e)(1,4)dioxin	67323-36-2	Intentional addition / 1,000ppm	chemical products
13690	Cuprate(2-), [29H,31H-phthalocyanine-C-C-disulfonato(4--N29,N30,N31,N32)-, barium (1:1)	67340-41-4	Contains (regardless of intentional or impurities)	chemical products
13691	Chromium, [3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-	67352-35-6	Contains (regardless of intentional or impurities)	chemical products
13692	Chromate(1-), bis[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	67352-37-8	Contains (regardless of intentional or impurities)	chemical products
13693	9-Octadecenoic acid (Z)-, (butylstannylidene)tris(thio-2,1-ethanedyl) ester	67361-76-6	Contains (regardless of intentional or impurities)	chemical products
13694	9-Octadecenoic acid (Z)-, (dibutylstannylidene)bis(thio-2,1-ethanedyl) ester	67361-77-7	Contains (regardless of intentional or impurities)	chemical products
13695	Molybdenum, bis(dibutylcarbamodithioato-S,S)-, mu-oxo-oxo-mu-thioxo-d-	67368-85-8	Intentional addition / 1%	chemical products
13696	Molybdenum, bis(dibutylcarbamodithioato-kappa.S,kappa.S)oxodi-mu-thioxothioxodi-	67368-86-9	Intentional addition / 1%	chemical products
13697	Trisilver(1+) imidodisulphate	67372-98-9	Intentional addition / 25%	chemical products
13698	alpha-Cypermethrin	67375-30-8	Contains (regardless of intentional or impurities)	chemical products
13699	3-Octene, 8-bromo-	67385-68-6	Intentional addition / 1,000ppm	chemical products
13700	1-Chloro-1,2,2,3-tetrafluoropropane	67406-66-0	Intentional addition	chemical products
13701	1,3-Dichloro-1,2,2-trifluoropropane	67406-68-2	Intentional addition	chemical products
13702	Stannane, (acetylenecarbonyl)oxy(triphenyl)-	67410-20-2	Contains (regardless of intentional or impurities)	chemical products
13703	Seleninic acid, propyl-	67465-26-3	Contains (regardless of intentional or impurities)	chemical products
13704	Cobaltate(1-), bis(2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-))-, sodium	67486-73-1	Intentional addition / 1,000ppm	chemical products
13705	Bis(pentamethylcyclopentadienyl)manganese	67506-86-9	Contains (regardless of intentional or impurities)	chemical products
13706	1,2,3,4,6,7-Heptachlorodibenzofuran	67562-39-4	Contains (regardless of intentional or impurities)	chemical products
13707	Ethanesulfonic acid, 2-hydroxy-, nickel(2+) salt (2:1)	67562-43-0	Contains (regardless of intentional or impurities)	chemical products
13708	Ethanesulfonic acid, 2-hydroxy-, tin(2+) salt (2:1)	67562-44-1	Intentional addition / 1,000ppm	chemical products
13709	Cis-4-[3-(p-tert-butylphenyl)-2-methylpropyl]-2,6-dimethylmorpholine	67564-91-4	Contains (regardless of intentional or impurities)	chemical products
13710	Benzenamine, 4-methyl-, hydrobromide	67614-05-5	Intentional addition / 25%	chemical products
13711	Aluminum barium cerium magnesium oxide	67621-72-1	Intentional addition / 1,000ppm	chemical products
13712	Barium (Z)-hexadec-9-enoate	67627-67-2	Intentional addition / 1,000ppm	chemical products
13713	Benzidine, Ni(2+) salt	67632-50-2	Contains (regardless of intentional or impurities)	chemical products
13714	Trichloromethyl perchlorate	67632-66-0	Intentional addition / 1,000ppm	chemical products
13715	2-Furancarboxaldehyde, 5-nitro-, O-[3-(2,6-dimethyl-1-piperidinyl)-2-hydroxypropyl]oxime, monohydrochloride	67642-21-1	Contains (regardless of intentional or impurities)	chemical products
13716	Trisioctyl 2,2',2''-[[dodecylstannylidene]tris(thio)]triacetate	67649-65-4	Contains (regardless of intentional or impurities)	chemical products
13717	Dihydrogen [3-[[4,5-dihydro-3-methyl-5-oxo-1-[4-[[2-(sulphoxy)ethyl]sulphonyl]phenyl]-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonato(4-)]cuprate(2-)	67689-48-9	Intentional addition / 1,000ppm	chemical products
13718	Copper, [N,N,N',N''-tetrakis[3-(dimethylamino)propyl]-29H,31H-phthalocyanine-C,C,C,C-tetrasulfonamidato(2-)-N29,N30,N31,N32]-	67689-49-0	Intentional addition / 1,000ppm	chemical products
13719	6,11-Dioxo-5,12-distannahexadecane, 5,5,12,12-tetrabutyl-8-octyl-7,10-dioxo-	67701-37-5	Contains (regardless of intentional or impurities)	chemical products
13720	5,7,9,14-Tetraoxa-6,8-distannaocadeca-2,11-dienoic acid, 6,6,8,8-tetraoctyl-4,10,13-trioxo-, butyl ester, (Z,Z)-	67704-30-7	Intentional addition / 1,000ppm	chemical products
13721	Dibromochloropropanes	67708-83-2	Intentional addition / 1,000ppm	chemical products
13722	2-Butenoic acid, 4,4'-[[1,1,3,3-tetrabutyl-1,3-distannoxaneydi]bis(oxy)]bis(4-oxo-, diisooctyl) ester, (Z,Z)-	67708-87-6	Intentional addition / 1,000ppm	chemical products
13723	Leach solutions, copper oxide ore, acid	67711-87-9	Intentional addition / 1,000ppm	chemical products
13724	Cement copper	67711-88-0	Intentional addition / 1,000ppm	chemical products
13725	Calclines, copper roasting	67711-89-1	Contains (regardless of intentional or impurities)	chemical products
13726	Flue dust, copper-refining	67711-90-4	Intentional addition / 1,000ppm	chemical products
13727	Matte, copper	67711-91-5	Contains (regardless of intentional or impurities)	chemical products
13728	Slags, copper smelting	67711-92-6	Contains (regardless of intentional or impurities)	chemical products
13729	Slags, copper converter	67711-93-7	Contains (regardless of intentional or impurities)	chemical products
13730	Slags, copper fire-refining	67711-94-8	Contains (regardless of intentional or impurities)	chemical products
13731	Slimes and Sludges, copper electrolytic	67711-95-9	Contains (regardless of intentional or impurities)	chemical products
13732	Slags, copper electrolytic slime smelting	67711-96-0	Contains (regardless of intentional or impurities)	chemical products
13733	Black metal, copper electrolytic slime smelting	67711-97-1	Contains (regardless of intentional or impurities)	chemical products
13734	Slags, dore furnace	67711-98-2	Contains (regardless of intentional or impurities)	chemical products
13735	Leach residues, dore furnace slags	67711-99-3	Contains (regardless of intentional or impurities)	chemical products
13736	Slimes and Sludges, copper refining	67712-00-9	Contains (regardless of intentional or impurities)	chemical products
13737	2,3,4,4',5,5'-Heptabromo-1,1-biphenyl	67733-52-2	Intentional addition / 1,000ppm	chemical products
13738	2,3,7,8-Tetrabromodibenzofuran	67733-57-7	Intentional addition / 100ppm	chemical products
13739	Nickel, (2-propanol)[2,2'-thiobis[4-(1,1,3,3-tetramethylbutyl)phenolato]](2-)-O,O',S]-	67763-27-3	Contains (regardless of intentional or impurities)	chemical products
13740	Ethanol, 2,2,2'-nitrotris-, monoester with boric acid (H3BO3)	67785-78-8	Intentional addition / 1%	chemical products
13741	Quinolinium, 1-ethyl-2-[[3-ethyl-5-methoxy-2(3H)-benzoselenazolydene)methyl]-6-methoxy-, bromide	67800-88-8	Contains (regardless of intentional or impurities)	chemical products
13742	Naphth[1,2-d]oxazolium, 2-[3-[5-chloro-3-ethyl-1,3-dihydro-1-[3-(trithylammonio)propyl]-2H-benzimidazol-2-ylidene]-1-propenyl]-1-ethyl-, diperchlorate	67800-90-2	Intentional addition / 1,000ppm	chemical products
13743	Chromate(1-), bis[3-[4-[(5-chloro-2-hydroxyphenyl)azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, sodium	67800-97-9	Contains (regardless of intentional or impurities)	chemical products
13744	Chromate(1-), [3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]][2-hydroxy-3-[[2-hydroxyphenyl)amino]-5-nitrobenzenesulfonato(3-)-N3,O2,O3]-, trisodium	67800-98-0	Contains (regardless of intentional or impurities)	chemical products
13745	Copper, [N,N,N',N''N''-hexabutyl-29H,31H-phthalocyanine-C,C,C-trisulfonamidato(2-)-N29,N30,N31,N32]-	67800-99-1	Intentional addition / 1,000ppm	chemical products
13746	Copper, [N,N,N',N''N''N''-octabutyl-29H,31H-phthalocyanine-C,C,C,C-tetrasulfonamidato(2-)-N29,N30,N31,N32]-	67801-00-7	Intentional addition / 1,000ppm	chemical products
13747	Benzenesulfonic acid, 5-chloro-4-ethyl-2-[(2-hydroxy-1-naphthalenyl)azo]-, barium salt (2:1)	67801-01-8	Contains (regardless of intentional or impurities)	chemical products
13748	1,2,4-Benzenetricarboxylic acid, cobalt(2+) salt (1:1)	67801-57-4	Intentional addition / 1,000ppm	chemical products
13749	Nickel(2+), hexaammine-, (OC-6-11)-, carbonate (1:1)	67806-76-2	Contains (regardless of intentional or impurities)	chemical products
13750	Cobaltate(3-), tris[6-hydroxy-5-nitroso-2-naphthalenesulfonato(2-)]-, trisodium	67815-64-9	Intentional addition / 1,000ppm	chemical products
13751	Benzoic acid, 2-[(2-amino-5-hydroxy-7-sulfo-1-naphthalenyl)azo]-5-nitro-, monosodium salt	67815-66-1	Contains (regardless of intentional or impurities)	chemical products
13752	Hexanoic acid, 2-ethyl-, indium(3+) salt	67816-06-2	Intentional addition / 1%	chemical products
13753	Propanedinitrile, [[4-(4-nitrobenzoyl)oxy]phenyl]methylene]-	67821-33-4	Intentional addition	chemical products
13754	Distanonoxane, 1,1,3,3-tetramethyl-1,3-bis[(1-oxododecyl)oxy]-	67827-58-1	Contains (regardless of intentional or impurities)	chemical products
13755	Distanonoxane, 1,1,3,3-tetramethyl-1,3-bis[(1-oxo-9-octadecyl)oxy]-, (Z,Z)-	67827-59-2	Contains (regardless of intentional or impurities)	chemical products
13756	Ethanol, 2,2'-[[tetrahydro-4H-1,3,6,2-dioxazaborocin-2-yl]imino]bis-	67827-68-3	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
13757	Cuprate(6-), [7-[[6-[[4-chloro-6-[[3-sulphophenylamino]-1,3,5-triazin-2-yl]amino]-2-sulphophenylazo]-2,5-dihydroxy-7-sulfo-1-naphthalenyl]azo]-8-hydroxy-1,3,5-naphthalenesulfonate(8-)]-, hexahydrogen	67827-85-4	Intentional addition / 1,000ppm	chemical products
13758	Copper, [29H,31H-phthalocyanine-C,C,C,C-tetramethanaminato(2-)-N29,N30,N31,N32]-, tetrakis(hydroxyacetate)	67828-07-3	Intentional addition / 1,000ppm	chemical products
13759	Copper, [3-hydroxy-4-(phenylazo)-2-naphthalenecarboxylato(2-)-O2,03]-	67828-23-3	Intentional addition / 1,000ppm	chemical products
13760	Copper, [4-[[4-chlorophenyl]azo]-3-hydroxy-2-naphthalenecarboxylato(2-)-O2,03]-	67828-28-8	Intentional addition / 1,000ppm	chemical products
13761	Benzene diazonium, 3-chloro-4-(4-morpholinyl)-, tetrafluoroborate(1-)	67828-86-4	Intentional addition / 1%	chemical products
13762	(S)-Epichlorohydrin	67843-74-7	Intentional addition / 1,000ppm	chemical products
13763	Copper(1+), bis(1,2-ethanediamine-N,N)-, (T-4)-, bis(cyano-O)aurate(1-)	67859-40-9	Contains (regardless of intentional or impurities)	chemical products
13764	Silver(1+), diammine, bis(cyano-O)aurate(1-)	67859-42-1	Contains (regardless of intentional or impurities)	chemical products
13765	Copper(2+), bis(1,2-ethanediamine-N,N)-, (T-4)-tetrakis(cyano-O)argentate(2-)(1:1)	67859-43-2	Contains (regardless of intentional or impurities)	chemical products
13766	Copper(2+), bis(1,2-ethanediamine-N,N)-, bis[bis(cyano-O)argentate(1-)]	67859-44-3	Contains (regardless of intentional or impurities)	chemical products
13767	Cuprate(2-), [N,N-bis(carboxymethyl)glycinato(3-)-N,O,O,O']-, disodium, (T-4)-	67859-46-5	Intentional addition / 1,000ppm	chemical products
13768	Cuprate(3-), [4-hydroxy-3-[[2-hydroxy-5-[[2-sulfoxyethylsulfonyl]phenyl]azo]-7-[[1-oxo-3-sulpropyl]amino]-2-naphthalenesulfonato(5-)]-, trihydrogen	67859-50-1	Intentional addition / 1,000ppm	chemical products
13769	4H-1,2,3-Oxathiazinane-4-carboxylic acid, 2,2-dibutylthio-6-oxo-	67859-55-6	Contains (regardless of intentional or impurities)	chemical products
13770	Hexanoic acid, 3,5,5-trimethyl-, (dibutylstannylylene)bis(thio-2,1-ethanedyl) ester	67859-59-0	Contains (regardless of intentional or impurities)	chemical products
13771	Boroxin, tris(2-ethylhexyl)oxy-	67859-60-3	Intentional addition / 1%	chemical products
13772	9,12-Octadecadienoic acid (Z,Z)-, (dibutylstannylylene)bis(thio-2,1-ethanedyl) ester	67859-61-4	Contains (regardless of intentional or impurities)	chemical products
13773	Dodecanoic acid, (methylstannylylene)tris(thio-2,1-ethanedyl) ester	67859-62-5	Contains (regardless of intentional or impurities)	chemical products
13774	9-Octadecenoic acid (Z)-, (dimethylstannylylene)bis(thio-2,1-ethanedyl) ester	67859-63-6	Contains (regardless of intentional or impurities)	chemical products
13775	9,12-Octadecadienoic acid (Z,Z)-, (dimethylstannylylene)bis(thio-2,1-ethanedyl) ester	67859-64-7	Contains (regardless of intentional or impurities)	chemical products
13776	Tetradecanoic acid, (dibutylstannylylene)bis(thio-2,1-ethanedyl) ester	67859-65-8	Contains (regardless of intentional or impurities)	chemical products
13777	Sulfurous acid, potassium silver(1+) salt	67859-68-1	Intentional addition / 25%	chemical products
13778	Sulfurous acid, gold(3+) sodium salt (4:1:5)	67859-69-2	Intentional addition	chemical products
13779	Sulfurous acid, gold(3+) potassium salt (4:1:5)	67859-70-5	Intentional addition	chemical products
13780	Phosphoric acid, rhodium(3+) salt (1:1)	67859-71-6	Contains (regardless of intentional or impurities)	chemical products
13781	Boric acid (H3BO3), compound with morpholine	67859-78-3	Intentional addition / 1%	chemical products
13782	Barium ethyl acetoacetate	67860-62-2	Intentional addition / 1,000ppm	chemical products
13783	Chromium, mu-hydroxytetrahydroxy[mu-(2-methyl-2-propenoato-O,O)]di-	67874-39-9	Intentional addition / 1,000ppm	chemical products
13784	Decanoic acid, (dimethylstannylylene)bis(thio-2,1-ethanedyl) ester	67874-41-3	Contains (regardless of intentional or impurities)	chemical products
13785	Octanoic acid, (dibutylstannylylene)bis(thio-2,1-ethanedyl) ester	67874-42-4	Contains (regardless of intentional or impurities)	chemical products
13786	Hexanoic acid, 3,5,5-trimethyl-, (methylstannylylene)tris(thio-2,1-ethanedyl) ester	67874-45-7	Contains (regardless of intentional or impurities)	chemical products
13787	8-Oxa-3,5-dithia-4-stannadecan-1-ol, 4-methyl-9-oxo-4-[[2-(1-oxopropoxy)ethyl]thio]-, propanoate	67874-46-8	Contains (regardless of intentional or impurities)	chemical products
13788	8-Oxa-3,5-dithia-4-stannadecan-1-ol, 4,4-dibutyl-9-oxo-, acetate	67874-47-9	Contains (regardless of intentional or impurities)	chemical products
13789	8-Oxa-3,5-dithia-4-stannadecan-1-ol, 4,4-dimethyl-9-oxo-, acetate	67874-48-0	Contains (regardless of intentional or impurities)	chemical products
13790	8-Oxa-3,5-dithia-4-stannadecan-1-ol, 4,4-dibutyl-9-oxo-, propanoate	67874-49-1	Contains (regardless of intentional or impurities)	chemical products
13791	Decanoic acid, (butylstannylylene)tris(thio-2,1-ethanedyl) ester	67874-51-5	Contains (regardless of intentional or impurities)	chemical products
13792	Benzoic acid, 4-methyl-, barium salt	67874-52-6	Contains (regardless of intentional or impurities)	chemical products
13793	Hexanoic acid, 2-ethyl-, (methylstannylylene)tris(thio-2,1-ethanedyl) ester	67874-54-8	Contains (regardless of intentional or impurities)	chemical products
13794	Cobalt, [29H,31H-phthalocyanine-C-sulfonyl chlorido(2-)-N29,N30,N31,N32]-	67875-38-1	Intentional addition / 1,000ppm	chemical products
13795	1,2,3,3-Tetrachloro-1,1-difluoropropane	67879-59-8	Intentional addition	chemical products
13796	6-Methoxy-2-naphthothione	67886-70-8	Intentional addition	chemical products
13797	2,3,4,4,5-Pentabromobiphenyl	67888-97-5	Intentional addition / 1,000ppm	chemical products
13798	2,2',3,3',4,4',5'-Octabromo-1,1'-biphenyl	67889-00-3	Intentional addition / 1,000ppm	chemical products
13799	Distillates, petroleum, heavy aromatic	67891-79-6	Contains (regardless of intentional or impurities)	chemical products
13800	Distillates, petroleum, light aromatic	67891-80-9	Contains (regardless of intentional or impurities)	chemical products
13801	Benzene sulfonic acid, 3-chloro-4-ethyl-5-[[2-(hydroxy-1-naphthalenyl)azo]-], barium salt (2:1)	67892-38-0	Contains (regardless of intentional or impurities)	chemical products
13802	2-Naphthalenecarboxylic acid, 4-[[3-chloro-2-methyl-5-sulphophenyl]azo]-3-hydroxy-, barium salt (1:1)	67892-41-5	Contains (regardless of intentional or impurities)	chemical products
13803	1,5-Naphthalenedisulfonic acid, 2-[[2-(hydroxy-1-naphthalenyl)azo]-], barium salt (1:1)	67892-47-1	Contains (regardless of intentional or impurities)	chemical products
13804	Benzene sulfonic acid, 3-chloro-5-[[2-(hydroxy-1-naphthalenyl)azo]-4-methyl-, barium salt (2:1)	67892-50-6	Contains (regardless of intentional or impurities)	chemical products
13805	Cuprate(2-), [4-hydroxy-3-[[2-hydroxy-4-[[2-(sulfoxyethylsulfonyl]phenyl]azo]-1-naphthalenesulfonato(4-)]-, dihydrogen	67892-59-5	Intentional addition / 1,000ppm	chemical products
13806	2-Propenoic acid, 2-methyl-, zirconium(4+) salt	67893-01-0	Contains (regardless of intentional or impurities)	chemical products
13807	Cuprate(3-), [4-hydroxy-7-[[[5-hydroxy-6-[[2-hydroxy-5-sulphophenyl]azo]-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-3-[[2-methoxyphenyl]azo]-2-naphthalenesulfonato(5-)]-, trisodium	67893-09-8	Intentional addition / 1,000ppm	chemical products
13808	Chromate(1-), diaquat[4-[[4,5-dihydro-4-[[2-(hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]hydroxy-, sodium	67893-10-1	Contains (regardless of intentional or impurities)	chemical products
13809	Hexadecanoic acid, hentricontofluoro-	67905-19-5	Contains (regardless of intentional or impurities)	chemical products
13810	Hexanoic acid, 3,5,5-trimethyl-, (dimethylstannylylene)bis(thio-2,1-ethanedyl) ester	67905-20-8	Contains (regardless of intentional or impurities)	chemical products
13811	8-Oxa-3,5-dithia-4-stannadecan-1-ol, 4,4-dimethyl-9-oxo-, propanoate	67905-21-9	Contains (regardless of intentional or impurities)	chemical products
13812	8-Oxa-3,5-dithia-4-stannadecan-1-ol, 4-butyl-9-oxo-4-[[2-(1-oxopropoxy)ethyl]thio]-, propanoate	67905-22-0	Contains (regardless of intentional or impurities)	chemical products
13813	1-Propanol, 3-[[3-(boronooxy)propyl]amino]-	67905-33-3	Intentional addition / 1%	chemical products
13814	Aluminum, tris(triacontyl)-	67905-39-9	Intentional addition / 1,000ppm	chemical products
13815	Indate(1-), [[N,N'-1,2-ethanediy]bis[N-(carboxymethyl)glycinato]](4-)-N,N'.O'.O'.ON.ON]-, potassium, (OC-6-21)-	67906-11-0	Intentional addition / 1%	chemical products
13816	Nickelate(1-), [[N,N'-1,2-ethanediy]bis[N-(carboxymethyl)glycinato]](4-)-N,N'.O'.O'.ON.ON]-, potassium, (OC-6-21)-	67906-12-1	Contains (regardless of intentional or impurities)	chemical products
13817	Cobalt(2+), bis(1,2-propanediamine-N,N)-, bis[bis(cyano-O)aurate(1-)]	67906-18-7	Contains (regardless of intentional or impurities)	chemical products
13818	Cadmium(2+), bis(1,2-propanediamine-N,N)-, (T-4)-, bis[bis(cyano-O)aurate(1-)]	67906-19-8	Contains (regardless of intentional or impurities)	chemical products
13819	Copper(2+), (1,2-ethanediamine-N,N')(1,2-propanediamine-N,N')-, bis[bis(cyano-O)aurate(1-)]	67906-20-1	Contains (regardless of intentional or impurities)	chemical products
13820	Rhodium(1+), dichlorobis(1,2-ethanediamine-N,N)-, bis(cyano-O)aurate(1-)	67906-21-2	Contains (regardless of intentional or impurities)	chemical products
13821	Cobaltate(2-), bis(2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-, dilithium	67906-22-3	Intentional addition / 1,000ppm	chemical products
13822	Cobaltate(2-), bis(3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamido(2)]-, dilithium, (OC-6-22)-	67906-23-4	Intentional addition / 1,000ppm	chemical products
13823	2,7-Naphthalenedisulfonic acid, 3,3'-[[3,3'-dimethyl-1,1'-biphenyl]-4,4'-diyl]bis(azo)bis[5-(acetyl amino)-4-hydroxy-, tetrasodium salt	67906-44-9	Intentional addition	chemical products
13824	1,2-Benzenedicarboxylic acid, (methylstannylylene)tris(thio-2,1-ethanedyl) triisooctyl ester	67907-14-6	Contains (regardless of intentional or impurities)	chemical products
13825	1,2-Benzenedicarboxylic acid, (dimethylstannylylene)bis(thio-2,1-ethanedyl) diisooctyl ester	67907-15-7	Contains (regardless of intentional or impurities)	chemical products
13826	2,7-Naphthalenedisulfonic acid, 5-amino-4-hydroxy-3-[[4-[[1-hydroxy-4-sulfo-2-naphthalenyl]azo]-3,3'-dimethyl-1,1'-biphenyl]-4-yl]azo]-, trillithium salt	67923-89-1	Intentional addition	chemical products
13827	Chromate(1-), bis(4-[[4-chloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	67924-22-5	Contains (regardless of intentional or impurities)	chemical products
13828	Cobaltate(6-), [[[[1,2-ethanediy]bis[[nitrido-kappa.N]bis(methylene)]tetrakis[phosphonato-kappa.O]](6-)]-, pentapotassium hydrogen, (OC-6-21)-	67924-23-6	Intentional addition / 1,000ppm	chemical products
13829	Tin, dibutylbis[N-(diethylthioamino)difluoro-	67924-24-7	Contains (regardless of intentional or impurities)	chemical products
13830	Platinat(2-), hexachloro-, (OC-6-11)-, dihydrogen, reaction products with tributylphosphine hydrochloride and N-[3-(trimethoxysilyl)propyl]-1,2-ethanediamine	67924-25-8	Contains (regardless of intentional or impurities)	chemical products
13831	1,3-Diazido-1,1,3,3-tetrabutylidistannoxane	67936-79-2	Contains (regardless of intentional or impurities)	chemical products
13832	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonato(3-)](1-)-[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, sodium hydrogen	67939-06-4	Contains (regardless of intentional or impurities)	chemical products
13833	Stannane, butyltris[[2-[[2-ethyl-1-oxoethyl]oxyethyl]thio]-	67939-23-5	Contains (regardless of intentional or impurities)	chemical products
13834	1,2-Benzenedicarboxylic acid, (butylstannylylene)tris(thio-2,1-ethanedyl) triisooctyl ester	67939-28-0	Contains (regardless of intentional or impurities)	chemical products
13835	Copper, [nonabromopentachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-	67939-30-4	Intentional addition / 1,000ppm	chemical products
13836	1-Propene, 1-bromo-1-chloro-	67939-54-2	Intentional addition / 1,000ppm	chemical products
13837	1-Propene, 1-bromo-2-chloro-	67939-55-3	Intentional addition / 1,000ppm	chemical products
13838	9,12-Octadecadienoic acid (Z,Z)-, cadmium salt	67939-62-2	Contains (regardless of intentional or impurities)	chemical products
13839	Hexanoic acid, 2-ethyl-, (dimethylstannylylene)bis(thio-2,1-ethanedyl) ester	67939-64-4	Contains (regardless of intentional or impurities)	chemical products
13840	Uranium, bis(2-ethylhexanoato-O)dioxo-, (T-4)-	67939-77-9	Contains (regardless of intentional or impurities)	chemical products
13841	1-Cyano-3-methylthiourea, monosodium salt	67944-71-2	Intentional addition	chemical products
13842	Benzene diazonium, 4-[ethyl(2-hydroxyethyl)amino]-2-methyl-, tetrafluoroborate(1-)	67952-27-6	Intentional addition / 1%	chemical products
13843	Boric acid (H3BO3), compound with 2,2'-minobis[ethanol]	67952-33-4	Intentional addition / 1%	chemical products
13844	Butanedioic acid, 2,3-dihydroxy-, [R-(R*(R*))-, nickel(2+) salt (2:1)	67952-41-4	Contains (regardless of intentional or impurities)	chemical products
13845	Butanedioic acid, 2,3-dihydroxy-, [R-(R*(R*))-, manganese(2+) salt (2:1)	67952-42-5	Contains (regardless of intentional or impurities)	chemical products
13846	Chloric acid, nickel(2+) salt	67952-43-6	Contains (regardless of intentional or impurities)	chemical products
13847	2-Propenoic acid, 2-methyl-, cobalt(2+) salt	67952-53-8	Intentional addition / 1,000ppm	chemical products
13848	2-Undecene, 1-bromo-	67952-61-8	Intentional addition / 1,000ppm	chemical products
13849	1,2,3-Propanetriol, mono(dihydrogen phosphate), nickel(2+) salt (1:1)	67952-69-6	Contains (regardless of intentional or impurities)	chemical products
13850	Cobaltate(1-), bis(3-[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamido(2-)]-, hydrogen	67952-74-3	Intentional addition / 1,000ppm	chemical products
13851	Cuprate(4-), [mu-[[5-(acetyl amino)-3-[[4-[[8-amino-1-hydroxy-3,6-disulfo-2-naphthalenyl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(8-)]]di-, tetrasodium	67952-80-1	Intentional addition / 1,000ppm	chemical products
13852	Cuprate(4-), [mu-[[6,6'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]di]]]bis[1,3-naphthalenedisulfonato(8-)]]di-, tetrasodium	67952-81-2	Intentional addition / 1,000ppm	chemical products
13853	Methanaminium, N-[4-bis[4-(dimethylamino)phenyl]methylene]-2,5-cyclohexadien-1-ylidene-N-methyl-, tetraosoa-mu-oxododecaoxo[[mu.12-[phosphato(3-)-O:O:O:O:O:O:O:O:O:O:O:O:O:O:O]]dodecamylbdate(3-)(3:1)	67953-39-3	Contains (regardless of intentional or impurities)	chemical products
13854	Borate(1-), tetrafluoro-, iron(3+) (3:1)	67953-73-5	Contains (regardless of intentional or impurities)	chemical products
13855	Nickelate(4-), [[[nitri]tris(methylene)tris[phosphonato]](6-)-N.OP.OP.OP]-, triammonium hydrogen, (T-4)-	67968-22-3	Contains (regardless of intentional or impurities)	chemical products
13856	Cuprate(2-), [C,C-bis(aminosulfonyl)-29H,31H-phthalocyanine-C,C-disulfonato(4-)-N29,N30,N31,N32]-, disodium	67968-25-6	Intentional addition / 1,000ppm	chemical products
13857	Cobaltate(4-), [[nitri]tris(methylene)tris[phosphonato]](6-)-N.OP.OP.OP]-, triammonium hydrogen, (T-4)-	67968-64-3	Intentional addition / 1,000ppm	chemical products
13858	Cobaltate(3-), [N,N-bis(phosphonomethyl)glycinato(5-)]-, triammonium, (T-4)-	67968-65-4	Intentional addition / 1,000ppm	chemical products
13859	Cobaltate(3-), [N,N-bis(phosphonomethyl)glycinato(5-)]-, trisodium, (T-4)-	67968-66-5	Intentional addition / 1,000ppm	chemical products
13860	Pentasodium cobaltous ethylene[[nitrido(methylene)phosphonate]]	67969-67-9	Intentional addition / 100ppm	chemical products
13861	Ethane, 1,1'-oxybis-, mono[tetrafluoroborate(1-)]	67969-82-8	Intentional addition / 1%	chemical products
13862	Methane, oxybis-, compound with hydrogen tetrafluoroborate(1-)(1:1)	67969-83-9	Intentional addition / 1%	chemical products
13863	Pentane, 3,3-bis(bromomethyl)-	67969-84-0	Intentional addition / 1,000ppm	chemical products

Table with 5 columns: #, Substance Name, CAS-No, Misumi Standards (numbers as threshold), and Applicable Item. It lists various chemical substances such as Boric acid, Chromate, Cuprate, and Platinum, along with their CAS numbers and applicable standards.

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
13965	Platinate (Pt(OH)6 <sup>2-</sup> ), (OC-6-11)-, dihydrogen, compound with 2-aminoethanol (1:2)	68133-90-4	Contains (regardless of intentional or impurities)	chemical products
13966	Methanaminium, N,N,N-trimethyl-, (OC-6-11)-platinate (Pt(OH)6 <sup>2-</sup> ) (2:1)	68133-91-5	Contains (regardless of intentional or impurities)	chemical products
13967	L-glycero-L-ido-Heptonico acid, cyclic 5,6-ester with boric acid (H3BO3), disodium salt	68134-31-6	Intentional addition / 1%	chemical products
13968	Formic acid, copper nickel salt	68134-59-8	Contains (regardless of intentional or impurities)	chemical products
13969	Cuprate(3-), [mu-3-[[4-[[2,8-dihydroxy-6-sulfo-1-naphthalenylo]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-4,5-dihydroxy-2,7-naphthalenedisulfonato(7-)]di-, trisodium	68140-31-8	Intentional addition / 1,000ppm	chemical products
13970	Cuprate(3-), [mu-4-[[3,3'-dihydroxy-4-[[1-hydroxy-4-sulfo-2-naphthalenylo]azo][1,1'-biphenyl]-4-yl]azo]-3-hydroxy-2,7-naphthalenedisulfonato(7-)]di-, trisodium	68140-32-9	Intentional addition / 1,000ppm	chemical products
13971	Borate(1-), tetrakis(4-fluorophenyl)-, lithium	68140-33-0	Intentional addition / 1%	chemical products
13972	Cuprate(4-), [mu-4-amino-6-[[4-[[1,9-dihydroxy-3,6-disulfo-2-naphthalenylo]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-5-hydroxy-1,3-naphthalenedisulfonato(8-)]di-, tetrasodium	68140-34-1	Intentional addition / 1,000ppm	chemical products
13973	Cuprate(4-), [mu-4-amino-6-[[3,3'-dihydroxy-4-[[2-hydroxy-3,6-disulfo-1-naphthalenylo]azo][1,1'-biphenyl]-4-yl]azo]-5-hydroxy-1,3-naphthalenedisulfonato(8-)]di-, tetrasodium	68140-35-2	Intentional addition / 1,000ppm	chemical products
13974	Cuprate(4-), [mu-5-amino-3-[[3,3'-dihydroxy-4-[[2-hydroxy-3,6-disulfo-1-naphthalenylo]azo][1,1'-biphenyl]-4-yl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(8-)]di-, tetrasodium	68140-36-3	Intentional addition / 1,000ppm	chemical products
13975	Cuprate(3-), [mu-4-[[3,3'-dihydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenylo]azo][1,1'-biphenyl]-4-yl]azo]-3-hydroxy-2,7-naphthalenedisulfonato(7-)]di-, trisodium	68140-37-4	Intentional addition / 1,000ppm	chemical products
13976	Phenol, 4-chloro-3,5-dimethyl-, triester with boric acid (H3BO3)	68141-09-3	Intentional addition / 1%	chemical products
13977	Platinum(4+), hexaammine-, tetrahydroxide, (OC-6-11)-	68145-80-8	Contains (regardless of intentional or impurities)	chemical products
13978	Tall oil, cobalt salt	68152-91-0	Intentional addition / 1%	chemical products
13979	Zirconium, oxo tall-oil fatty acid complexes	68153-82-8	Contains (regardless of intentional or impurities)	chemical products
13980	Chromate(5-), bis[6-(acetylamino)-4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfo]phenyl]azo]-2-naphthalenesulfonato(4-)]-, pentahydrogen	68155-48-6	Contains (regardless of intentional or impurities)	chemical products
13981	Cuprate(2-), [29H,31H-phthalocyanine-C,O-disulfonato(4-)-N29,N30,N31,N32]-, dihydrogen, compound with 2-ethyl-N-(2-ethylhexyl)-1-hexanamine (1:2)	68155-92-0	Intentional addition / 1,000ppm	chemical products
13982	Sulfuric acid, ammonium rhodium(3+) salt (2:1:1)	68156-19-4	Contains (regardless of intentional or impurities)	chemical products
13983	4-(Bromomethyl)phenyldihydroxyborane	68162-47-0	Contains (regardless of intentional or impurities)	chemical products
13984	Bis(cyclopentadienyl)hafnium(IV) dihydride	68183-87-9	Intentional addition / 1%	chemical products
13985	Lignosulfonic acid, manganese(2+) salt	68186-83-4	Contains (regardless of intentional or impurities)	chemical products
13986	C.I. Pigment Green 50	68186-85-6	Contains (regardless of intentional or impurities)	chemical products
13987	Cobalt-aluminum blue spinel	68186-86-7	Intentional addition / 1,000ppm	chemical products
13988	C.I. Pigment Blue 72	68186-87-8	Intentional addition / 1,000ppm	chemical products
13989	C.I. Pigment Brown 33	68186-88-9	Contains (regardless of intentional or impurities)	chemical products
13990	C.I. Pigment Black 25	68186-89-0	Contains (regardless of intentional or impurities)	chemical products
13991	C.I. Pigment Brown 24	68186-90-3	Contains (regardless of intentional or impurities)	chemical products
13992	Spinel, chromium copper black	68186-91-4	Contains (regardless of intentional or impurities)	chemical products
13993	C.I. Pigment Yellow 163	68186-92-5	Contains (regardless of intentional or impurities)	chemical products
13994	C.I. Pigment Yellow 158	68186-93-6	Contains (regardless of intentional or impurities)	chemical products
13995	C.I. Pigment Black 26	68186-94-7	Contains (regardless of intentional or impurities)	chemical products
13996	C.I. Pigment Blue 71	68186-95-8	Contains (regardless of intentional or impurities)	chemical products
13997	Spinel, chromium iron manganese zinc brown	68186-96-9	Contains (regardless of intentional or impurities)	chemical products
13998	Spinel, chromium cobalt iron black	68186-97-0	Contains (regardless of intentional or impurities)	chemical products
13999	C.I. Pigment Red 231	68186-99-2	Contains (regardless of intentional or impurities)	chemical products
14000	C.I. Pigment Black 24	68187-00-8	Contains (regardless of intentional or impurities)	chemical products
14001	C.I. Pigment Yellow 160	68187-01-9	Contains (regardless of intentional or impurities)	chemical products
14002	Spinel, cobalt tin grey	68187-05-3	Contains (regardless of intentional or impurities)	chemical products
14003	C.I. Pigment Brown 35	68187-09-7	Contains (regardless of intentional or impurities)	chemical products
14004	C.I. Pigment Brown 34	68187-10-0	Contains (regardless of intentional or impurities)	chemical products
14005	C.I. Pigment Blue 36	68187-11-1	Contains (regardless of intentional or impurities)	chemical products
14006	C.I. Pigment Red 233	68187-12-2	Contains (regardless of intentional or impurities)	chemical products
14007	Zircon, iron coral	68187-13-3	Contains (regardless of intentional or impurities)	chemical products
14008	C.I. Pigment Yellow 159	68187-15-5	Contains (regardless of intentional or impurities)	chemical products
14009	C.I. Pigment Red 230	68187-27-9	Contains (regardless of intentional or impurities)	chemical products
14010	Manganese, 2-ethylhexanoate tall-oil fatty acids complexes	68187-38-2	Contains (regardless of intentional or impurities)	chemical products
14011	C.I. Pigment Blue 73	68187-40-6	Intentional addition / 1%	chemical products
14012	C.I. Pigment Green 26	68187-49-5	Contains (regardless of intentional or impurities)	chemical products
14013	C.I. Pigment Black 29	68187-50-8	Intentional addition / 1,000ppm	chemical products
14014	C.I. Pigment Yellow 119	68187-51-9	Intentional addition / 1,000ppm	chemical products
14015	C.I. Pigment Red 236	68187-53-1	Contains (regardless of intentional or impurities)	chemical products
14016	C.I. Pigment Black 23	68187-54-2	Contains (regardless of intentional or impurities)	chemical products
14017	Coal, brown, reaction products with sodium dichromate, neutralized	68187-56-4	Contains (regardless of intentional or impurities)	chemical products
14018	Pitch, coal tar-petroleum	68187-57-5	Contains (regardless of intentional or impurities)	chemical products
14019	Nepheline syenite, manganese zirconium brown	68187-64-4	Contains (regardless of intentional or impurities)	chemical products
14020	Alkyl iodides, C4-20, gamma-omega-perfluoro	68188-12-5	Contains (regardless of intentional or impurities)	chemical products
14021	Resin acids and Rosin acids, barium salts	68188-14-7	Intentional addition / 1,000ppm	chemical products
14022	Distillates, coal-petroleum, condensed-ring aromatic	68188-48-7	Contains (regardless of intentional or impurities)	chemical products
14023	Borate(2-), heptaooxotetra-, dihydrogen, compound with N-ethylethanamine (1:2)	68189-02-6	Intentional addition / 1%	chemical products
14024	Borate(2-), heptaooxotetra-, dihydrogen, compound with N,N-diethylethanamine (1:2)	68189-03-7	Intentional addition / 1%	chemical products
14025	Nickel, bis[(2-hydroxy-4-octylphenyl)phenylmethanolato-O-0']	68189-15-1	Contains (regardless of intentional or impurities)	chemical products
14026	Antimonate(4-), (acetato-O)bis[1,2-ethanediolato(2-)-O,O']oxo-, zinc (1:2)	68189-16-2	Contains (regardless of intentional or impurities)	chemical products
14027	1-Naphthalenesulfonic acid, 2-[[1-hydroxy-2-naphthalenylo]azo]-, barium salt (2:1)	68189-18-4	Contains (regardless of intentional or impurities)	chemical products
14028	2-Naphthalenesulfonic acid, 1-[[2-hydroxy-1-naphthalenylo]azo]-, barium salt (2:1)	68189-25-3	Contains (regardless of intentional or impurities)	chemical products
14029	Cobalt, [29H,31H-phthalocyanine-C,O-disulfonyl dichlorido(2-)-N29,N30,N31,N32]-	68189-40-2	Intentional addition / 1,000ppm	chemical products
14030	Sulfurous acid, ammonium platinum(2+) salt (4.6:1)	68191-11-7	Contains (regardless of intentional or impurities)	chemical products
14031	Sulfurous acid, ammonium rhodium(3+) salt (3.3:1)	68191-12-8	Contains (regardless of intentional or impurities)	chemical products
14032	Bis(tert-butylcyclopentadienyl)dimethylhafnium(IV)	68193-45-3	Intentional addition / 1%	chemical products
14033	Silicic acid, barium magnesium salt	68201-15-0	Intentional addition / 1,000ppm	chemical products
14034	Aluminum barium strontium oxide	68201-16-1	Intentional addition / 1,000ppm	chemical products
14035	Barium, acetate tallow fatty acids complexes	68201-19-4	Intentional addition / 1,000ppm	chemical products
14036	C.I. Pigment Red 235	68201-65-0	Contains (regardless of intentional or impurities)	chemical products
14037	Copper, bis[[2-[[3-oxo-3-(2-oxocyclopentyl)propyl]-1,4-phenylene bis(ethyl carbonato)](1-)]-	68201-66-1	Intentional addition / 1,000ppm	chemical products
14038	Chromate(5-), bis[4-hydroxy-6-[[2-hydroxy-5-methylphenyl]azo]-3-[[2-hydroxy-5-nitro-3-sulfo]phenyl]azo]-2-naphthalenesulfonato(4-)]-, pentahydrogen	68201-73-0	Contains (regardless of intentional or impurities)	chemical products
14039	Chromate(5-), bis[6-(acetylamino)-4-hydroxy-3-[[2-hydroxy-3-nitro-5-sulfo]phenyl]azo]-2-naphthalenesulfonato(4-)]-, pentahydrogen	68201-74-1	Contains (regardless of intentional or impurities)	chemical products
14040	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, ammonium iron(3+) manganese(2+) zinc salt	68201-80-9	Contains (regardless of intentional or impurities)	chemical products
14041	Hexanoic acid, 2-ethyl-, iron(2+) iron(3+) salt	68201-81-0	Intentional addition / 1%	chemical products
14042	Hexanoic acid, 3,5,5-trimethyl-, iron(2+) iron(3+) salt	68201-82-1	Intentional addition / 1%	chemical products
14043	Acetic acid, mercapto-, 1,2-ethanedithiol ester, polymer with dibutylloxostannane	68201-92-3	Contains (regardless of intentional or impurities)	chemical products
14044	Hydrazinium(1+), (OC-6-21)-[[N,N'-1,2-ethanedithylbis[N-(carboxymethyl)glycinato]](4-)-N,N',O,O',OH,OH]cobaltate(2-)(2:1)	68201-98-9	Intentional addition / 1,000ppm	chemical products
14045	(1-Oxoheptyl)ferrocene	68209-43-8	Intentional addition / 1%	chemical products
14046	(1-Oxoocetyl)ferrocene	68209-44-9	Intentional addition / 1%	chemical products
14047	(1-Oxononyl)ferrocene	68209-45-0	Intentional addition / 1%	chemical products
14048	(1-Oxododecyl)ferrocene	68209-66-5	Intentional addition / 1%	chemical products
14049	(1-Oxoheptyl)ferrocene	68209-67-6	Intentional addition / 1%	chemical products
14050	Cobaltate(1-), [C-(chlorosulfonyl)-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen	68213-72-9	Intentional addition / 1,000ppm	chemical products
14051	Hexanoic acid, 3,5,5-trimethyl-, iron salt	68213-78-5	Intentional addition / 1%	chemical products
14052	Phosphonium, triphenyl(phenylmethyl)-, (T-4)-tetrachlorocadmate(2-)(2:1)	68214-25-5	Contains (regardless of intentional or impurities)	chemical products
14053	Chromate(1-), diaquabis(2-hydroxybenzoato(2-)-O1,O2)-, ammonium	68214-26-6	Contains (regardless of intentional or impurities)	chemical products
14054	Chromate(1-), diaquabis(2-hydroxybenzoato(2-)-O1,O2)-, sodium	68214-27-7	Contains (regardless of intentional or impurities)	chemical products
14055	Copper(4+), [[1,1',1'',1''']-29H,31H-phthalocyaninetetrakis(methylene)tetrakis(1,1-dimethylhydrazinimato)](2-)-N29,N30,N31,N32]-, tetrachloride	68214-29-9	Intentional addition / 1,000ppm	chemical products
14056	Benzothiazolium, 3-ethyl-2-[[3-[[3-[[3-ethyl-5,6-dimethoxy-2(3H)-benzothiazolylidene]methyl]-5,5-dimethyl-2-cyclohexen-1-ylidene]-1-propenyl]-5,5-dimethoxy-2-cyclohexen-1-ylidene]methyl]-5,6-dimethoxy-, perchlorate	68220-31-5	Intentional addition / 1,000ppm	chemical products
14057	Borate(1-)-10B, tetrafluoro-, potassium	68220-77-9	Intentional addition / 1%	chemical products
14058	Boron, tris(3(or 4)-methylphenolato)[tris(2-(dimethylamino)ethyl) orthoborate-N]-	68224-81-7	Intentional addition / 1%	chemical products
14059	Chromate(1-), 2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)](2-hydroxy-5-(1,1-dimethylethyl)benzoato(2-)-O1,O2)-, sodium	68227-17-8	Contains (regardless of intentional or impurities)	chemical products
14060	Cuprate(4-), [mu-[[6,6'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis[azo(4,5-dihydro-3-methyl-5-oxo-1H-pyrazole-4,1-diy)]]bis[1,3-naphthalenedisulfonato]](8-)]di-, tetrahydrogen	68239-45-2	Intentional addition / 1,000ppm	chemical products
14061	Tin, dibutyl[N-(carboxymethyl)-N-(2-hydroxyethyl)glycinato(2-)]-	68239-46-3	Contains (regardless of intentional or impurities)	chemical products
14062	Cobaltate(1-), [N-[[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenylo]acetamidato(2-)](3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen	68239-47-4	Intentional addition / 1,000ppm	chemical products
14063	Tin, bis(acetato-O)dibutyl[1,4-diazabicyclo[2,2,2]octane-N1]-, monoformate	68239-50-9	Contains (regardless of intentional or impurities)	chemical products
14064	Silicic acid, hexafluoro-, chromium(3+) (3:2)	68239-51-0	Contains (regardless of intentional or impurities)	chemical products
14065	Chromate(1-), hydroxy[3-hydroxy-4-[[2-hydroxy-1-naphthalenylo]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, hydrogen	68239-52-1	Contains (regardless of intentional or impurities)	chemical products
14066	Cuprate(4-), [29H,31H-phthalocyanine-2,9,16,24-tetra-sulfonato(6-)-N29,N30,N31,N32]-, tetrasodium, (SP-4-2)-	68239-53-2	Intentional addition / 1,000ppm	chemical products
14067	Cuprate(4-), [7-[[4-[[5-[[5-chloro-2,6-difluoro-4-pyrimidinylamino]-2-methoxy-3-sulfo]phenyl]azo]-2-hydroxyphenyl]azo]-8-hydroxy-1,3,6-naphthalenetrisulfonato(9-)]-, tetrasodium	68239-54-3	Intentional addition / 1,000ppm	chemical products
14068	Di(acetato-O)X1,4-diazabicyclo[2,2,2]octane-N1)Cobalt	68239-55-4	Intentional addition / 1,000ppm	chemical products
14069	Cobalt, bis(acetato-O)X1,4-diazabicyclo[2,2,2]octane-N1)-, homopolymer	68239-56-5	Intentional addition / 1,000ppm	chemical products
14070	Dichloro(1,4-diazabicyclo[2,2,2]octane-N1)Cobalt	68239-57-6	Intentional addition / 1,000ppm	chemical products
14071	Cobalt, dichloro(1,4-diazabicyclo[2,2,2]octane-N1)-, homopolymer	68239-58-7	Intentional addition / 1,000ppm	chemical products
14072	Copper, [N-N'-bis[3-(dimethylamino)propyl]-29H,31H-phthalocyanine-C,O-disulfonamidato(2-)-N29,N30,N31,N32]-	68239-59-8	Intentional addition / 1,000ppm	chemical products
14073	Benzoazolium, 5-(acetylamino)-2-[[[5-(acetylamino)-3-ethyl-2(3H)-benzoxazolylidene]methyl]-1-butenyl]-3-ethyl-, perchlorate	68239-68-9	Intentional addition / 1,000ppm	chemical products
14074	1-Hexene, 3,3,4,4,5,5,6,6,6-nonafluoro-, polymer with ethene and tetrafluoroethene	68258-85-5	Intentional addition / 1,000ppm	chemical products





#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
14178	Chromium, 1-[[5-chloro-2-hydroxy-4-nitrophenylazo]-2-naphthalenol 1-[[2-hydroxy-5-nitrophenylazo]-2-naphthalenol complexes	68411-09-6	Intentional addition / 1,000ppm	chemical products
14179	Calcium hydroxide (Ca(OH)2), reaction products with iron oxide (Fe2O3), magnesium hydroxide and silica	68411-12-1	Intentional addition / 1%	chemical products
14180	Calcium hydroxide (Ca(OH)2), reaction products with iron oxide (Fe2O3) and magnesium hydroxide	68411-13-2	Intentional addition / 1%	chemical products
14181	Calcium hydroxide (Ca(OH)2), reaction products with magnesium hydroxide and silicic acid (H4SiO4) zirconium salt (1:1)	68411-14-3	Contains (regardless of intentional or impurities)	chemical products
14182	1,2-Propanediol, reaction products with boron sodium oxide (B5NaO8)	68411-21-2	Intentional addition / 1%	chemical products
14183	Phosphoric acid, reaction products with aluminum hydroxide and boric acid (H3BO3)	68411-22-3	Intentional addition / 1%	chemical products
14184	1,2-Propanediol, reaction products with boron sodium oxide (B4Na2O7)	68411-23-4	Intentional addition / 1%	chemical products
14185	Benzene sulfonic acid, C10-13-alkyl derivatives, sodium salts	68411-30-3	Intentional addition / 100ppm	chemical products
14186	Antimony, citric acid complexes	68411-49-4	Contains (regardless of intentional or impurities)	chemical products
14187	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfo [[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]sulfonyl derivatives	68412-18-0	Contains (regardless of intentional or impurities)	chemical products
14188	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-aminophenyl]amino]sulfonyl sulfo derivatives	68412-19-1	Contains (regardless of intentional or impurities)	chemical products
14189	Nickel, dextrin complexes	68412-20-4	Contains (regardless of intentional or impurities)	chemical products
14190	Molybdenum, bis(dibutylcarbamothioato)di-mu-oxodiodi-, sulfurized	68412-26-0	Intentional addition / 1%	chemical products
14191	Silicic acid (H4SiO4), tetrapropyl ester, hydrolyzed, reaction products with dibutylbis[[1-oxododecyl]oxy]stannane	68412-36-2	Contains (regardless of intentional or impurities)	chemical products
14192	C.I. Pigment Yellow 164	68412-38-4	Contains (regardless of intentional or impurities)	chemical products
14193	2-Propanone, reaction products with diphenylamine	68412-48-6	Intentional addition / 100ppm	chemical products
14194	Propanoic acid, 3,3'-[[dibutylstannylene]bis(thio)]bis-, diisooctyl ester, reaction products with dibutylxostannane	68412-50-0	Contains (regardless of intentional or impurities)	chemical products
14195	Poly(oxy-1,2-ethanediyl), alpha-(nonphenyl)-omega-hydroxy-, branched, phosphates	68412-53-3	Intentional addition / 100ppm	chemical products
14196	C.I. Pigment Blue 74	68412-74-8	Intentional addition / 100ppm	chemical products
14197	C.I. Pigment Red 232	68412-79-3	Contains (regardless of intentional or impurities)	chemical products
14198	Sulfurous acid, platinum(2+) sodium salt (4:1:6)	68413-57-0	Contains (regardless of intentional or impurities)	chemical products
14199	Ferrate(2-), [[N,N'-1,2-ethanediyl]bis[N-(carboxymethyl)glycinate]](4-)-N,N',O,O',ON,ON]hydroxy-, diammonium, (PB-7-11-12133)	68413-60-5	Intentional addition / 1%	chemical products
14200	Cobaltate(1-), [3-[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamido(2-)]N-[7-hydroxy-8-[[2-hydroxy-5-[[methylamino]sulfonyl]phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, hydrogen	68413-61-6	Intentional addition / 1,000ppm	chemical products
14201	Rhodium, (acetato-O)bis(1,3-diphenyl-1,3-propanedionato-O,O')	68413-70-7	Contains (regardless of intentional or impurities)	chemical products
14202	Boric acid, compound with 2,2,2'-nitrotris[ethanol]	68413-80-9	Intentional addition / 1%	chemical products
14203	Ethanaminium, N-[4-[[4-(diethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-ethyl-, [mu,12-[[orthosilico(4-)-O-O-O-O'-O'-O'-O'-O'-O'-O'-O']tetracos-a-mu-oxododecaoxododecamolybdate(4-)](4:1)	68413-81-0	Contains (regardless of intentional or impurities)	chemical products
14204	Benzoselenazolium, 2-[2-chloro-2-(2-thienyl)ethyl]-3-ethyl-5-methoxy-, chloride	68413-87-6	Contains (regardless of intentional or impurities)	chemical products
14205	(Z)-2,2'-[[1,4-dioxabut-2-ene-1,4-diyl]bis(oxy)]bis[2-octyl-1,3,2-dioxastannepin-4,7-dione]	68420-14-4	Contains (regardless of intentional or impurities)	chemical products
14206	Butyl (Z,Z)-6-[[4-butoxy-1,4-dioxabut-2-enyl]oxy]oct-6-yl-4,8,11-trioxo-5,7,12-trioxo-6-stannahexadeca-2,9-dienoate	68420-16-6	Contains (regardless of intentional or impurities)	chemical products
14207	2-Naphthalenesulfonic acid, 5-[[dimethylphenyl]azo]-6-hydroxy-, barium salt (2:1)	68422-67-3	Contains (regardless of intentional or impurities)	chemical products
14208	Fatty acids, C9-15-neo-, manganese salts	68424-36-2	Contains (regardless of intentional or impurities)	chemical products
14209	Quaternary ammonium compounds, benzyl-C8-16-alkyldimethyl, chlorides	68424-64-0	Intentional addition / 1,000ppm	chemical products
14210	Quaternary ammonium compounds, benzyl-C12-16-alkyldimethyl, chlorides	68424-65-1	Intentional addition / 100ppm	chemical products
14211	Quaternary ammonium compounds, di-C8-10-alkyldimethyl, chlorides	68424-65-3	Intentional addition / 1,000ppm	chemical products
14212	Distillates, petroleum, naphtha-raffinate pyrolyzate-derived, gasoline-blending	68425-29-6	Contains (regardless of intentional or impurities)	chemical products
14213	Gasoline, natural gas, natural	68425-31-0	Intentional addition / 1,000ppm	chemical products
14214	Petrolatum, petroleum, oxidized, barium salt	68425-33-2	Intentional addition / 1,000ppm	chemical products
14215	Raffinates, petroleum, reformer, Lurgi unit-separated	68425-35-4	Contains (regardless of intentional or impurities)	chemical products
14216	Boric acid, compound with 2,2'-iminobis[ethanol]	68425-66-1	Intentional addition / 1%	chemical products
14217	Boric acid, compound with 2-aminoethanol	68425-67-2	Intentional addition / 1%	chemical products
14218	Copper, [1,2,3,9,10,16,17,23,24-nonabromo-11,25-dichloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-2)	68425-85-4	Intentional addition / 1,000ppm	chemical products
14219	Cuprate(4-), [4-amino-5-hydroxy-6-[[2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-3-[[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2-naphthalenedisulfonato(6-)]-], tetrahydrogen	68425-86-5	Intentional addition / 1,000ppm	chemical products
14220	2-Pentanol, 4-methyl-, phosphate, manganese(2+) salt	68439-21-4	Contains (regardless of intentional or impurities)	chemical products
14221	D-Mannitol, ester with boric acid (H3BO3)	68439-36-1	Intentional addition / 1%	chemical products
14222	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[4-phenyl-3-(phenylmethyl)-3-(4-sulfoxyphenyl)butyl]amino]sulfonyl sulfo derivatives, sodium salts	68439-42-9	Intentional addition / 1,000ppm	chemical products
14223	Alcohols, C12-14, ethoxylated	68439-50-9	Intentional addition / 1%	chemical products
14224	Carnauba wax, reaction products with borax, morpholine and oleic acid	68439-94-1	Intentional addition / 1%	chemical products
14225	Fatty acids, tall-oil, polymers with boron trifluoride-phenol complex, p-tert-butylphenol, ethylene glycol, formaldehyde, linseed oil, pentaerythritol, phenol, phthalic anhydride, beta-pinene, rosin, tung oil and turpentine oil	68441-04-3	Contains (regardless of intentional or impurities)	chemical products
14226	Spinel, aluminum zinc zirconium	68441-06-5	Contains (regardless of intentional or impurities)	chemical products
14227	Acetic acid, mercapto-, isooctyl ester, reaction products with dichlorodimethylstannane, sodium sulfide (Na2S) and trichloromethylstannane	68441-20-3	Contains (regardless of intentional or impurities)	chemical products
14228	Benzenediazonium, 4-(phenylamino)-, sulfate (1:1), polymer with formaldehyde, cadmium chloride complexes	68441-39-4	Contains (regardless of intentional or impurities)	chemical products
14229	Bismuth, [mu,12-[[carbonato(2-)-O-O']dioxodi-, reaction products with acetylene, copper acetylide (Cu(C2)) and formaldehyde	68441-43-0	Intentional addition / 1,000ppm	chemical products
14230	Boric acid (H3BO3), trimethyl ester, reaction products with bisphenol A-epichlorohydrin polymer diglycidyl ether	68441-45-2	Intentional addition / 1%	chemical products
14231	1,3-Butadiene, homopolymer, brominated	68441-46-3	Intentional addition / 900ppm	chemical products
14232	Cuprate(3-), [mu,7-[[3,3'-dihydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1,1'-biphenyl]-4-yl]azo]-8-hydroxy-1,3,8-naphthalenetrisulfonato(7-)]di-, lithium triethanolamine salts	68441-64-5	Intentional addition / 1,000ppm	chemical products
14233	9-Octadecenoic acid (Z)-, 2-mercaptoethyl ester, reaction products with dichlorodimethylstannane, sodium sulfide(Na2S) and trichloromethylstannane	68442-12-6	Contains (regardless of intentional or impurities)	chemical products
14234	2-Propanoic acid, 2-methyl-, polymer with ethylbenzene, ethyl 2-propenoate and 2-propenamide, reaction products with formaldehyde, butylated	68442-47-7	Intentional addition / 1%	chemical products
14235	Aluminate(1-), tetrachloro-, copper(1+), benzene complexes	68442-63-7	Intentional addition / 1,000ppm	chemical products
14236	Aluminate(1-), tetrachloro-, copper(1+), toluene complexes	68442-64-8	Intentional addition / 1,000ppm	chemical products
14237	Barium, carbonate 4-nonylphenol complexes	68442-67-1	Intentional addition / 1,000ppm	chemical products
14238	Benzene sulfonic acid, dodecyl-, reaction products with ethanamine	68442-72-8	Intentional addition / 1%	chemical products
14239	Boric acid (H3BO3), reaction products with aniline and 2-chloro-1,4-dihydroxy-9,10-anthracenedione	68442-74-0	Intentional addition / 1%	chemical products
14240	Carbonic acid disodium salt, reaction products with aluminum sulfate (2:3), barium chloride, disodium carbonate and disodium hydrogen phosphate	68442-84-2	Contains (regardless of intentional or impurities)	chemical products
14241	Copper phthalocyanine, chlorosulfonated	68442-86-4	Intentional addition / 1,000ppm	chemical products
14242	Hydrofluoric acid, reaction products with alumina and cobalt chloride (CoCl2)	68442-96-6	Contains (regardless of intentional or impurities)	chemical products
14243	Manganese boron neodecanoate	68442-99-9	Contains (regardless of intentional or impurities)	chemical products
14244	Manganese, 2-ethylhexanoate 3,5,5-trimethylhexanoate complexes	68443-00-5	Contains (regardless of intentional or impurities)	chemical products
14245	Amines, C18-22-tert-alkyl, compounds with tungstic acid (H2WO4)	68443-09-4	Intentional addition / 1%	chemical products
14246	Molybdate (MoO42-), (T-4)-, dihydrogen, compound with 2-aminoethanol (1:1)	68443-30-1	Contains (regardless of intentional or impurities)	chemical products
14247	Phenol, 4-(1-methyl-1-phenylethyl)-, triester with boric acid (H3BO3)	68443-37-8	Intentional addition / 1%	chemical products
14248	Benzothiazolium, 2-[3-(3-ethyl-5-methoxy-2(3H)-benzoselenazoylidene)-2-(2-thienyl)-1-propenyl]-3-(2-hydroxyethyl)-6-methoxy-5-methyl-, bromide	68443-89-0	Contains (regardless of intentional or impurities)	chemical products
14249	Ethanaminium, N-[4-[[4-(diethylamino)phenyl]phenylmethylene]-2,5-cyclohexadien-1-ylidene]-N-ethyl-, tetracos-a-mu-oxododecaoxo[[mu,12-[[phosphato(3-)-O-O-O-O'-O'-O'-O'-O'-O'-O'-O']dodecatetrate(3-)](3:1)]	68444-39-3	Intentional addition / 1%	chemical products
14250	Bis[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzene-1-sulphonamidato(2-)]chromate(1-)	68448-46-4	Contains (regardless of intentional or impurities)	chemical products
14251	Cobalt(5+), tris(N,N-bis(2-aminoethyl)-1,2-ethanediamine-N,N,N',N')hexa-,mu-,hydroxy(nickel)tri-, pentaperchlorate	68449-39-8	Contains (regardless of intentional or impurities)	chemical products
14252	Cobalt, borate neodecanoate complexes	68457-13-6	Intentional addition / 100ppm	chemical products
14253	Phosphorodithioic acid, mixed O,O'-bis(isobutyl and penty) esters, zinc salts	68457-79-4	Intentional addition / 1,000ppm	chemical products
14254	Zirconium, acetate carbonate dimethylhexanoate oxo complex	68457-89-6	Contains (regardless of intentional or impurities)	chemical products
14255	Zirconium, carbonate dipropylene glycol 2-ethylhexanoate isobutyl alcohol oxo propionate cobalt complexes	68457-90-9	Contains (regardless of intentional or impurities)	chemical products
14256	Gelatin, polymers with chromium potassium sulfate (1:1:2)	68458-80-0	Intentional addition / 1,000ppm	chemical products
14257	5,7,12,14-Tetraoxa-6,13-distannaocadeca-2,9,16-trienedioic acid, 6,6,13,13-tetrabutyl-4,8,11,15-tetraoxo-, dicyclohexyl ester, (?;2;2)	68460-05-9	Contains (regardless of intentional or impurities)	chemical products
14258	5,7,12,14-Tetraoxa-6,13-distannaocadeca-2,9,16-trienedioic acid, 6,6,13,13-tetrabutyl-4,8,11,15-tetraoxo-, bis(phenylmethyl) ester, (?;2;2)	68460-06-0	Contains (regardless of intentional or impurities)	chemical products
14259	Cobalt, bis(D-glycero-D-ido-heptonato)-	68475-45-6	Intentional addition / 1,000ppm	chemical products
14260	Copper, bis(D-glycero-D-ido-heptonato)-	68475-46-7	Intentional addition / 1,000ppm	chemical products
14261	Manganese, bis(D-glycero-D-ido-heptonato)-	68475-47-8	Contains (regardless of intentional or impurities)	chemical products
14262	Chromium hydroxide oxide silicate	68475-47-0	Intentional addition / 1,000ppm	chemical products
14263	Alkanes, C1-2	68475-57-0	Contains (regardless of intentional or impurities)	chemical products
14264	Alkanes, C2-3	68475-58-1	Contains (regardless of intentional or impurities)	chemical products
14265	Alkanes, C3-4	68475-59-2	Contains (regardless of intentional or impurities)	chemical products
14266	Alkanes, C4-5	68475-60-5	Contains (regardless of intentional or impurities)	chemical products
14267	Aromatic hydrocarbons, C6-8, naphtha-raffinate pyrolyzate-derived	68475-70-7	Contains (regardless of intentional or impurities)	chemical products
14268	Distillates, petroleum, catalytic reformed depentanizer	68475-79-6	Contains (regardless of intentional or impurities)	chemical products
14269	Distillates, petroleum, light steam-cracked naphtha	68475-80-9	Contains (regardless of intentional or impurities)	chemical products
14270	Fatty acids, tall-oil, reaction products with borax and 2-(dimethylamino)ethanol	68476-15-3	Intentional addition / 1%	chemical products
14271	Feldspar	68476-25-5	Intentional addition	chemical products
14272	Fuel gases	68476-26-6	Contains (regardless of intentional or impurities)	chemical products
14273	Fuel gases, crude oil distillates	68476-29-9	Contains (regardless of intentional or impurities)	chemical products
14274	Fuel oil, no. 4	68476-31-3	Contains (regardless of intentional or impurities)	chemical products
14275	Fuel oil, residues-straight-run gas oils, high-sulfur	68476-32-4	Contains (regardless of intentional or impurities)	chemical products
14276	Fuel oil, residual	68476-33-5	Contains (regardless of intentional or impurities)	chemical products
14277	Fuels, diesel, no. 2	68476-34-6	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
14278	Hydrocarbons, C3-4	68476-40-4	Contains (regardless of intentional or impurities)	chemical products
14279	Hydrocarbons, C4-5	68476-42-6	Contains (regardless of intentional or impurities)	chemical products
14280	Hydrocarbons, C3-11, catalytic cracker distillates	68476-46-0	Contains (regardless of intentional or impurities)	chemical products
14281	Hydrocarbons, C2-6, C6-8 catalytic reformer	68476-47-1	Contains (regardless of intentional or impurities)	chemical products
14282	Hydrocarbons, C2-4, C3-rich	68476-49-3	Contains (regardless of intentional or impurities)	chemical products
14283	Hydrocarbons, C7=5, C5-6-rich	68476-50-6	Contains (regardless of intentional or impurities)	chemical products
14284	Hydrocarbons, C5-rich	68476-55-1	Contains (regardless of intentional or impurities)	chemical products
14285	Petroleum gases, liquefied	68476-85-7	Contains (regardless of intentional or impurities)	chemical products
14286	Petroleum gases, liquefied, sweetened	68476-86-8	Contains (regardless of intentional or impurities)	chemical products
14287	Sulfite liquors and Cooking liquors, spent, alkali-sulfur dioxide treated, copper salts	68477-11-2	Intentional addition / 1,000ppm	chemical products
14288	Tar acids, residues, distillates, first-cut	68477-23-6	Contains (regardless of intentional or impurities)	chemical products
14289	Distillates, petroleum, catalytic reformer fractionator residue, high-boiling	68477-29-2	Contains (regardless of intentional or impurities)	chemical products
14290	Distillates, petroleum, catalytic reformer fractionator residue, intermediate-boiling	68477-30-5	Contains (regardless of intentional or impurities)	chemical products
14291	Distillates, petroleum, catalytic reformer fractionator residue, low-boiling	68477-31-6	Contains (regardless of intentional or impurities)	chemical products
14292	Gases, petroleum, C3-4, isobutane-rich	68477-33-8	Contains (regardless of intentional or impurities)	chemical products
14293	Distillates, petroleum, C3-5, 2-methyl-2-butene-rich	68477-34-9	Contains (regardless of intentional or impurities)	chemical products
14294	Distillates, petroleum, C3-8, piperylene-rich	68477-35-0	Contains (regardless of intentional or impurities)	chemical products
14295	Distillates, petroleum, cracked steam-cracked petroleum distillates	68477-38-3	Contains (regardless of intentional or impurities)	chemical products
14296	Distillates, petroleum, polymerized steam-cracked petroleum distillates, C5-12 fraction	68477-50-9	Contains (regardless of intentional or impurities)	chemical products
14297	Distillates, petroleum, steam-cracked, C5-12 fraction	68477-53-2	Contains (regardless of intentional or impurities)	chemical products
14298	Distillates, petroleum, steam-cracked, C8-12 fraction	68477-54-3	Contains (regardless of intentional or impurities)	chemical products
14299	Distillates, petroleum, steam-cracked, C5-10 fraction, mixed with light steam-cracked petroleum naphtha C5 fraction	68477-55-4	Contains (regardless of intentional or impurities)	chemical products
14300	Extracts, petroleum, cold-acid, C4-6	68477-61-2	Contains (regardless of intentional or impurities)	chemical products
14301	Gases, petroleum, amine system feed	68477-65-6	Contains (regardless of intentional or impurities)	chemical products
14302	Gases, petroleum, benzene unit hydrodesulfurizer off	68477-66-7	Contains (regardless of intentional or impurities)	chemical products
14303	Gases, petroleum, benzene unit recycle, hydrogen-rich	68477-67-8	Contains (regardless of intentional or impurities)	chemical products
14304	Gases, petroleum, blend oil, hydrogen-nitrogen-rich	68477-68-9	Contains (regardless of intentional or impurities)	chemical products
14305	Gases, petroleum, butane splitter overheads	68477-69-0	Contains (regardless of intentional or impurities)	chemical products
14306	Gases, petroleum, C2-3	68477-70-3	Contains (regardless of intentional or impurities)	chemical products
14307	Gases, petroleum, catalytic-cracked gas oil depropanizer bottoms, C4-rich acid-free	68477-71-4	Contains (regardless of intentional or impurities)	chemical products
14308	Gases, petroleum, catalytic-cracked naphtha debutanizer bottoms, C3-5-rich	68477-72-5	Contains (regardless of intentional or impurities)	chemical products
14309	Gases, petroleum, catalytic cracked naphtha depropanizer overhead, C3-rich acid-free	68477-73-6	Contains (regardless of intentional or impurities)	chemical products
14310	Gases, petroleum, catalytic cracker	68477-74-7	Contains (regardless of intentional or impurities)	chemical products
14311	Gases, petroleum, catalytic cracker, C1-5-rich	68477-75-8	Contains (regardless of intentional or impurities)	chemical products
14312	Gases, petroleum, catalytic polymerized naphtha stabilizer overhead, C2-4-rich	68477-76-9	Contains (regardless of intentional or impurities)	chemical products
14313	Gases, petroleum, catalytic reformed naphtha stripper overheads	68477-77-0	Contains (regardless of intentional or impurities)	chemical products
14314	Gases, petroleum, catalytic reformer, C1-4-rich	68477-79-2	Contains (regardless of intentional or impurities)	chemical products
14315	Gases, petroleum, C6-8 catalytic reformer recycle	68477-80-5	Contains (regardless of intentional or impurities)	chemical products
14316	Gases, petroleum, C6-8 catalytic reformer	68477-81-6	Contains (regardless of intentional or impurities)	chemical products
14317	Gases, petroleum, C6-8 catalytic reformer recycle, hydrogen-rich	68477-82-7	Contains (regardless of intentional or impurities)	chemical products
14318	Gases, petroleum, C3-5 olefinic-paraffinic alkylation feed	68477-83-8	Contains (regardless of intentional or impurities)	chemical products
14319	Gases, petroleum, C2-return stream	68477-84-9	Contains (regardless of intentional or impurities)	chemical products
14320	Gases, petroleum, C4-rich	68477-85-0	Contains (regardless of intentional or impurities)	chemical products
14321	Gases, petroleum, deethanizer overheads	68477-86-1	Contains (regardless of intentional or impurities)	chemical products
14322	Gases, petroleum, deisobutanizer tower overheads	68477-87-2	Contains (regardless of intentional or impurities)	chemical products
14323	Distillates, petroleum, depentanizer overheads	68477-89-4	Contains (regardless of intentional or impurities)	chemical products
14324	Gases, petroleum, depropanizer dry, propene-rich	68477-90-7	Contains (regardless of intentional or impurities)	chemical products
14325	Gases, petroleum, depropanizer overheads	68477-91-8	Contains (regardless of intentional or impurities)	chemical products
14326	Gases, petroleum, dry sour, gas concentration unit off	68477-92-9	Contains (regardless of intentional or impurities)	chemical products
14327	Gases, petroleum, gas concentration reabsorber distillation	68477-93-0	Contains (regardless of intentional or impurities)	chemical products
14328	Gases, petroleum, gas recovery plant depropanizer overheads	68477-94-1	Contains (regardless of intentional or impurities)	chemical products
14329	Gases, petroleum, Girbatol unit feed	68477-95-2	Contains (regardless of intentional or impurities)	chemical products
14330	Gases, petroleum, hydrogen absorber off	68477-96-3	Contains (regardless of intentional or impurities)	chemical products
14331	Gases, petroleum, hydrogen-rich	68477-97-4	Contains (regardless of intentional or impurities)	chemical products
14332	Gases, petroleum, hydrotreater blend oil recycle, hydrogen-nitrogen-rich	68477-98-5	Contains (regardless of intentional or impurities)	chemical products
14333	Gases, petroleum, isomerized naphtha fractionator, C4-rich, hydrogen sulfide-free	68477-99-6	Contains (regardless of intentional or impurities)	chemical products
14334	Gases, petroleum, recycle, hydrogen-rich	68478-00-2	Contains (regardless of intentional or impurities)	chemical products
14335	Gases, petroleum, reformer make-up, hydrogen-rich	68478-01-3	Contains (regardless of intentional or impurities)	chemical products
14336	Gases, petroleum, reforming hydrotreater	68478-02-4	Contains (regardless of intentional or impurities)	chemical products
14337	Gases, petroleum, reforming hydrotreater, hydrogen-methane-rich	68478-03-5	Contains (regardless of intentional or impurities)	chemical products
14338	Gases, petroleum, reforming hydrotreater make-up, hydrogen-rich	68478-04-6	Contains (regardless of intentional or impurities)	chemical products
14339	Gases, petroleum, thermal cracking distillation	68478-05-7	Contains (regardless of intentional or impurities)	chemical products
14340	Residues, petroleum, butane splitter bottoms	68478-12-6	Contains (regardless of intentional or impurities)	chemical products
14341	Residues, petroleum, catalytic reformer fractionator residue distillation	68478-13-7	Contains (regardless of intentional or impurities)	chemical products
14342	Residues, petroleum, C6-8 catalytic reformer	68478-15-9	Contains (regardless of intentional or impurities)	chemical products
14343	Residual oils, petroleum, deisobutanizer tower	68478-16-0	Contains (regardless of intentional or impurities)	chemical products
14344	Residues, petroleum, heavy coker gas oil and vacuum gas oil	68478-17-1	Contains (regardless of intentional or impurities)	chemical products
14345	Tail gas (petroleum), catalytic cracked clarified oil and thermal cracked vacuum residue fractionation reflux drum	68478-21-7	Contains (regardless of intentional or impurities)	chemical products
14346	Tail gas, petroleum, catalytic cracked naphtha stabilization absorber	68478-22-8	Contains (regardless of intentional or impurities)	chemical products
14347	Tail gas, petroleum, catalytic cracker, catalytic reformer and hydrodesulfurizer combined fractionator	68478-24-0	Contains (regardless of intentional or impurities)	chemical products
14348	Tail gas, petroleum, catalytic cracker refractionation absorber	68478-25-1	Contains (regardless of intentional or impurities)	chemical products
14349	Tail gas, petroleum, catalytic reformed naphtha fractionation stabilizer	68478-26-2	Contains (regardless of intentional or impurities)	chemical products
14350	Tail gas, petroleum, catalytic reformed naphtha separator	68478-27-3	Contains (regardless of intentional or impurities)	chemical products
14351	Tail gas, petroleum, catalytic reformed naphtha stabilizer	68478-28-4	Contains (regardless of intentional or impurities)	chemical products
14352	Tail gas, petroleum, cracked distillate hydrotreater separator	68478-29-5	Contains (regardless of intentional or impurities)	chemical products
14353	Tail gas, petroleum, hydrodesulfurized straight-run naphtha separator	68478-30-8	Contains (regardless of intentional or impurities)	chemical products
14354	Tail gas, petroleum, saturate gas plant mixed stream, C4-rich	68478-32-0	Contains (regardless of intentional or impurities)	chemical products
14355	Tail gas, petroleum, saturate gas recovery plant, C1-2-rich	68478-33-1	Contains (regardless of intentional or impurities)	chemical products
14356	Tail gas, petroleum, vacuum residues thermal cracker	68478-34-2	Contains (regardless of intentional or impurities)	chemical products
14357	Barium, 4-nonylphenol phenol complexes	68478-41-1	Intentional addition / 1,000ppm	chemical products
14358	1,4-Benzenediamine, N,N'-mixed tolyl and xylyl derivatives	68478-45-5	Intentional addition / 100ppm	chemical products
14359	Boron, (benzenemethanamine)trifluoro-, (T-4)-, reaction products with butyl glycidyl ether	68478-46-6	Intentional addition / 1%	chemical products
14360	Cadmium, benzoate p-tert-butylbenzoate complexes	68478-53-5	Contains (regardless of intentional or impurities)	chemical products
14361	Chromium, 2-ethylhexanoate heptanoate complexes	68478-55-7	Intentional addition / 1,000ppm	chemical products
14362	Chromium, 3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-hydroxybenzenesulfonamide 3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonate complexes	68478-56-8	Intentional addition / 1,000ppm	chemical products
14363	Cobalt, 2-ethylhexanoate isononanoate complexes	68478-57-9	Intentional addition / 1%	chemical products
14364	Cobalt, 2-ethylhexanoate 3,5,5-trimethylhexanoate complexes	68478-58-0	Intentional addition / 1%	chemical products
14365	Octadecanoic acid, reaction products with ammonium hydroxide, borax and triethanolamine	68478-71-7	Intentional addition / 1%	chemical products
14366	Octadecanoic acid, 2-mercaptoethyl ester, reaction products with dichlorodimethylstannane, 2-mercaptoethyl palmitate, sodium sulfide and trichloromethylstannane	68478-76-2	Contains (regardless of intentional or impurities)	chemical products
14367	2-Propanamine, compound with boron trifluoride, reaction products with butyl glycidyl ether	68478-97-7	Contains (regardless of intentional or impurities)	chemical products
14368	Pyrochlore, bismuth cadmium ruthenium	68479-13-0	Contains (regardless of intentional or impurities)	chemical products
14369	Chromium, [N-[8-[15-(aminosulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]acetamidato(2-)]-	68479-93-6	Intentional addition / 1,000ppm	chemical products
14370	Chromate(2-), [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, sodium hydrogen	68479-94-7	Contains (regardless of intentional or impurities)	chemical products
14371	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium hydrogen	68479-95-8	Contains (regardless of intentional or impurities)	chemical products
14372	Diethyltoluenediamine	68479-98-1	Contains (regardless of intentional or impurities)	chemical products
14373	Iron(2+), bis(2,4,6-tri-2-pyridinyl-1,3,5-triazine-N1,N2,N6)-, (OC-6-12)-, sulfate (1:1)	68510-43-0	Intentional addition / 1%	chemical products
14374	Sodium zirconium oxide silicate (Na2Zr2O(SiO4)2)	68510-95-2	Contains (regardless of intentional or impurities)	chemical products
14375	C.I. Acid Black 2, barium salt	68510-98-5	Intentional addition / 1,000ppm	chemical products
14376	Vanadate (V3O81-), sodium, hydrate (2:1)	68510-99-6	Intentional addition / 1%	chemical products
14377	Nickel, 5,5'-azobis-2,4,6-tris(1H,3H,5H)-pyrimidinone complexes	68511-62-6	Contains (regardless of intentional or impurities)	chemical products
14378	Copper, [29H,31H-phthalocyaninato(2-)]-N29,N30,N31,N32]-, brominated chlorinated	68512-13-0	Intentional addition / 1,000ppm	chemical products
14379	Copper, [trichloro-29H,31H-phthalocyaninato(2-)]-N29,N30,N31,N32]-, sulfonated	68512-14-1	Intentional addition / 1,000ppm	chemical products
14380	Zinc sulfide (ZnS), nickel and silver-doped	68512-22-1	Contains (regardless of intentional or impurities)	chemical products
14381	Zinc sulfide (ZnS), copper and silver-doped	68512-23-2	Intentional addition / 1,000ppm	chemical products
14382	Zinc sulfide (ZnS), aluminum and copper and gold-doped	68512-24-3	Intentional addition / 1,000ppm	chemical products
14383	Phenol, methylstyrenated	68512-30-1	Intentional addition / 1,000ppm	chemical products
14384	Periclase, cobalt blue gray	68512-31-2	Intentional addition / 1%	chemical products
14385	Chromium, acetate butyrate complexes	68512-47-0	Intentional addition / 1,000ppm	chemical products
14386	Cadmium zinc sulfide ((Cd,Zn)S), copper chloride-doped	68512-49-2	Contains (regardless of intentional or impurities)	chemical products
14387	Cadmium zinc sulfide ((Cd,Zn)S), copper and manganese-doped	68512-50-5	Contains (regardless of intentional or impurities)	chemical products
14388	Cadmium zinc sulfide ((Cd,Zn)S), aluminum and copper-doped	68512-51-6	Contains (regardless of intentional or impurities)	chemical products
14389	Boric acid (H3BO3), reaction products with ethanolamine and triethanolamine	68512-53-8	Intentional addition / 1%	chemical products
14390	Residues, petroleum, heavy coker and light vacuum	68512-61-8	Contains (regardless of intentional or impurities)	chemical products
14391	Residues, petroleum, light vacuum	68512-62-9	Contains (regardless of intentional or impurities)	chemical products
14392	Solvent naphtha, petroleum, light aromatic, hydrotreated	68512-78-7	Contains (regardless of intentional or impurities)	chemical products
14393	Hydrocarbons, C3-4-rich, petroleum distillates	68512-91-4	Contains (regardless of intentional or impurities)	chemical products
14394	Naphtha, petroleum, full-range coker	68513-02-0	Contains (regardless of intentional or impurities)	chemical products
14395	Naphtha, petroleum, light catalytic reformed, aromatic-free	68513-03-1	Contains (regardless of intentional or impurities)	chemical products
14396	Gases, petroleum, catalytic reformed straight-run naphtha stabilizer overheads	68513-14-4	Contains (regardless of intentional or impurities)	chemical products
14397	Gases, petroleum, full-range straight-run naphtha dehexanizer off	68513-15-5	Contains (regardless of intentional or impurities)	chemical products
14398	Gases, petroleum, hydrocracking depropanizer off, hydrocarbon-rich	68513-16-6	Contains (regardless of intentional or impurities)	chemical products
14399	Gases, petroleum, light straight-run naphtha stabilizer off	68513-17-7	Contains (regardless of intentional or impurities)	chemical products
14400	Gases, petroleum, reformer effluent high-pressure flash drum off	68513-18-8	Contains (regardless of intentional or impurities)	chemical products
14401	Gases, petroleum, reformer effluent low-pressure flash drum off	68513-19-9	Contains (regardless of intentional or impurities)	chemical products
14402	Distillates, petroleum, catalytic reformed straight-run naphtha overheads	68513-63-3	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
1451	Gases, petroleum, C1-5, wet	68602-83-5	Contains (regardless of intentional or impurities)	chemical products
1452	Gases, petroleum, secondary absorber off, fluidized catalytic cracker overheads fractionater	68602-84-6	Contains (regardless of intentional or impurities)	chemical products
1453	Distillates, petroleum, thermal cracked naphtha and gas oil	68603-00-9	Contains (regardless of intentional or impurities)	chemical products
1454	Distillates, petroleum, thermal cracked naphtha and gas oil, C5-dimer-containing	68603-01-0	Contains (regardless of intentional or impurities)	chemical products
1455	Distillates, petroleum, thermal cracked naphtha and gas oil, extractive	68603-03-2	Contains (regardless of intentional or impurities)	chemical products
1456	Naphtha (petroleum), aromatic-containing	68603-08-7	Contains (regardless of intentional or impurities)	chemical products
1457	Hydrocarbon waxes, petroleum, oxidized, methyl esters, barium salts	68603-10-1	Intentional addition / 1,000ppm	chemical products
1458	Octanoic acid, branched, copper(2+) salts	68604-54-6	Intentional addition / 1,000ppm	chemical products
1459	Barium, nonylphenol tall-oil fatty acids complexes	68605-30-1	Intentional addition / 1,000ppm	chemical products
1460	Fatty acids, tall-oil, polymers with boron trifluoride-phenol complex, p-tert-butylphenol, ethylene glycol, formaldehyde, glycerol, linseed oil, maleic anhydride, pentaerythritol, phenol, phthalic anhydride, beta-pinene, rosin, tung oil and turpentine	68605-59-4	Intentional addition / 1%	chemical products
1461	Fatty acids, tall-oil, polymers with boron trifluoride-phenol complex, glycerol, phenol, phthalic anhydride, beta-pinene, rosin, soybean oil and turpentine	68605-60-7	Contains (regardless of intentional or impurities)	chemical products
1462	Fatty acids, tall-oil, polymers with boron trifluoride-phenol complex, glycerol, phenol, phthalic anhydride, beta-pinene, soybean oil and turpentine	68605-61-8	Contains (regardless of intentional or impurities)	chemical products
1463	Gasoline, pyrolysis, debutanizer bottoms	68606-10-0	Contains (regardless of intentional or impurities)	chemical products
1464	Gasoline, straight-run, topping-plant	68606-11-1	Contains (regardless of intentional or impurities)	chemical products
1465	Hydrocarbons, C2-4	68606-25-7	Contains (regardless of intentional or impurities)	chemical products
1466	Hydrocarbons, C3	68606-26-8	Contains (regardless of intentional or impurities)	chemical products
1467	Gases, petroleum, alkylation feed	68606-27-9	Contains (regardless of intentional or impurities)	chemical products
1468	Gases, petroleum, depropanizer bottoms fractionation off	68606-34-8	Contains (regardless of intentional or impurities)	chemical products
1469	Petroleum products, refinery gases	68607-11-4	Contains (regardless of intentional or impurities)	chemical products
1470	Polyphosphoric acids, zinc salts	68607-18-1	Intentional addition / 25%	chemical products
1471	Residues, petroleum, topping plant, low-sulfur	68607-30-7	Contains (regardless of intentional or impurities)	chemical products
1472	Resin acids and Rosin acids, calcium nickel salts	68607-31-8	Contains (regardless of intentional or impurities)	chemical products
1473	Resin acids and Rosin acids, zirconium salts	68607-35-2	Contains (regardless of intentional or impurities)	chemical products
1474	Spinel, aluminum cobalt tin	68608-09-3	Contains (regardless of intentional or impurities)	chemical products
1475	Sulfonic acids, petroleum, sodium salts	68608-26-4	Intentional addition / 1,000ppm	chemical products
1476	Zeolites, manganese containing	68608-42-4	Contains (regardless of intentional or impurities)	chemical products
1477	9,10-Anthracenedione, 1-amino-, reaction products with copper oxide (CuO) and 3,9-dibromo-7H-benz[de]anthracen-7-one, chlorinated	68608-72-0	Intentional addition / 1,000ppm	chemical products
1478	C.I. Pigment Violet 48	68608-93-5	Intentional addition / 1,000ppm	chemical products
1479	Cobalt, borate isononanoate neodecanoate complexes	68609-02-9	Intentional addition / 1%	chemical products
1480	Copper, C6-19-branched carboxylate naphthenate complexes	68609-03-0	Intentional addition / 1,000ppm	chemical products
1481	Gadolinium yttrium oxide ((Gd,Y)2O3), europium-doped	68609-45-0	Intentional addition / 1%	chemical products
1482	Manganese, 2-ethylhexanoate naphthenate complexes	68609-86-9	Contains (regardless of intentional or impurities)	chemical products
1483	C.I. Pigment Violet 47	68610-13-9	Intentional addition / 1,000ppm	chemical products
1484	Plumbane, ethyl methyl derivatives	68610-17-3	Contains (regardless of intentional or impurities)	chemical products
1485	C.I. Pigment Yellow 157	68610-24-2	Contains (regardless of intentional or impurities)	chemical products
1486	Phenol, 4-methyl-, reaction products with dicyclopentadiene and isobutylene	68610-51-5	Intentional addition / 1,000ppm	chemical products
1487	Acetic acid, anhydride, reaction products with boron trifluoride and 1,5,9-trimethyl-1,5,9-cyclododecatriene	68610-78-6	Contains (regardless of intentional or impurities)	chemical products
1488	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonate(3-)]-, trihydrogen, nitro derivatives	68610-93-5	Contains (regardless of intentional or impurities)	chemical products
1489	Chromium, 2,5-dichloro-4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonate 3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonate complexes	68610-94-6	Intentional addition / 1,000ppm	chemical products
1490	Phenol, 4,4'-(1-methylethylidene)bis-, polymer with (chloromethyl)oxirane, reaction products with trimethylboroxin	68611-26-7	Intentional addition / 1%	chemical products
1491	C.I. Pigment Yellow 162	68611-42-7	Contains (regardless of intentional or impurities)	chemical products
1492	C.I. Pigment Yellow 161	68611-43-8	Contains (regardless of intentional or impurities)	chemical products
1493	Silicic acid (H4SiO4), zinc salt (1:2), arsenic and manganese-doped	68611-46-1	Contains (regardless of intentional or impurities)	chemical products
1494	Silicic acid (H4SiO4), zinc salt (1:2), manganese-doped	68611-47-2	Contains (regardless of intentional or impurities)	chemical products
1495	Wurtzite, copper indium yellow	68611-66-5	Contains (regardless of intentional or impurities)	chemical products
1496	Wurtzite, manganese yellow	68611-67-6	Contains (regardless of intentional or impurities)	chemical products
1497	Zinc sulfide (ZnS), aluminum and copper-doped	68611-68-7	Intentional addition / 1,000ppm	chemical products
1498	Zinc sulfide (ZnS), copper chloride-doped	68611-70-1	Intentional addition / 1,000ppm	chemical products
1499	Platinum, chloro[[isooctylthio]acetato-O,S]thiobis[methane]-	68630-78-4	Contains (regardless of intentional or impurities)	chemical products
1500	Copper, [nonabromotetrachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-	68630-79-5	Intentional addition / 1,000ppm	chemical products
1501	Benzenamine, 4,4'-carbonimidoylbis[N,N-diethyl]-, compound with molybdenum hydroxide oxide phosphate	68630-90-0	Intentional addition / 1%	chemical products
1502	Cuprate(3-), [2-[[[1-hydroxy-7-[[4-[2-(4-nitro-2-sulphophenyl)ethenyl]-3-sulphophenyl]azoyl]-3-sulfo-2-naphthalenyl]azo]benzoato(5-)]-, trisodium	68647-43-8	Intentional addition / 1,000ppm	chemical products
1503	Molybdate (Mo7O24)-, cobalt(3+) (2:1)	68647-47-2	Contains (regardless of intentional or impurities)	chemical products
1504	Fatty acids, tall-oil, manganese salts, basic	68648-07-7	Contains (regardless of intentional or impurities)	chemical products
1505	Polyphosphoric acids, ammonium zinc salts	68648-43-1	Intentional addition / 25%	chemical products
1506	Phosphorodithioic acid, O,O-di-C1-14-alkyl esters, zinc salts	68649-42-3	Intentional addition / 100ppm	chemical products
1507	Poly(oxy-1,2-ethanediyd), alpha-sulfo-omega-(nonylphenyl)-, branched, ammonium salt	68649-55-8	Intentional addition / 100ppm	chemical products
1508	1-Propene, 1,1,2,3,3,3-hexafluoro-, polymer with 1,1-difluoroethene, ethene and tetrafluoroethene	68664-13-1	Intentional addition / 1,000ppm	chemical products
1509	Neodecanoic acid, chromium(3+) salt	68683-16-9	Intentional addition / 1,000ppm	chemical products
1510	Neodecanoic acid, yttrium(3+) salt	68683-17-0	Intentional addition / 1%	chemical products
1511	Trifluoromethyl	68694-11-1	Contains (regardless of intentional or impurities)	chemical products
1512	Octanoic acid, 2,2-dimethyl-, barium salt	68698-60-2	Contains (regardless of intentional or impurities)	chemical products
1513	Phosphoric acid, dipentyl ester, barium salt	68698-63-5	Contains (regardless of intentional or impurities)	chemical products
1514	Nickelate(6-), [4-[[[3,6-dichloro-4-pyridazinyl]carbonyl]amino]-2-sulphophenyl]azo]-4,5-dihydro-5-oxo-1-[5-[[[trisulfo-29H,31H-phthalocyaninyl]sulfonyl]amino]-2-sulphophenyl]-1H-pyrazole-3-carboxylato(8-)-N29,N30,N31,N32]-hexahydrogen	68698-80-6	Contains (regardless of intentional or impurities)	chemical products
1515	Zinc fluorophosphate	68705-59-9	Intentional addition / 25%	chemical products
1516	2,4-Dichlorophenylboronic acid	68716-47-2	Intentional addition / 1%	chemical products
1517	Tributyltin trifluoromethanesulfonate	68725-14-4	Contains (regardless of intentional or impurities)	chemical products
1518	Tributyl[ethylsulphonyloxy]stannane	68725-15-5	Contains (regardless of intentional or impurities)	chemical products
1519	Palladium, tetrachlorobis(methano)-, polymer with tin chloride (SnCl2)	68738-82-9	Contains (regardless of intentional or impurities)	chemical products
1520	9-Octadecenoic acid (Z)-, zirconium(2+) salt	68757-56-2	Contains (regardless of intentional or impurities)	chemical products
1521	Nickel(2+), hexamine-, (OC-6-11)-, diformate	68758-60-1	Contains (regardless of intentional or impurities)	chemical products
1522	[1,1'-Biphenyl]-ar,ar'-diol, tetrabromo-, polymer with (chloromethyl)oxirane and 4,4'-(1-methylethylidene)bis[phenol]	68758-75-8	Intentional addition / 1,000ppm	chemical products
1523	Benzeneselenazolum, 3-(2-carboxyethyl)-2-[[[3-(2-carboxyethyl)-2(3H)-benzeneselenazolidene]methyl]-1-butenyl]-5-methyl-, bromide	68758-81-6	Contains (regardless of intentional or impurities)	chemical products
1524	Extracts, petroleum, heavy naphthenic distillate solvent, aromatic concentrate	68783-00-6	Contains (regardless of intentional or impurities)	chemical products
1525	Extracts, petroleum, solvent-refined heavy paraffinic distillate solvent	68783-04-0	Contains (regardless of intentional or impurities)	chemical products
1526	Gases, petroleum, hydrocracking low-pressure separator	68783-06-2	Contains (regardless of intentional or impurities)	chemical products
1527	Gases, petroleum, refinery blend	68783-07-3	Contains (regardless of intentional or impurities)	chemical products
1528	Gas oils, petroleum, heavy atmospheric	68783-08-4	Contains (regardless of intentional or impurities)	chemical products
1529	Light distilled catalytic cracked naphtha (petroleum)	68783-09-5	Contains (regardless of intentional or impurities)	chemical products
1530	Naphtha, petroleum, unsweetened	68783-12-0	Contains (regardless of intentional or impurities)	chemical products
1531	Residues, petroleum, coker scrubber, condensed-ring-aromatic-containing	68783-13-1	Contains (regardless of intentional or impurities)	chemical products
1532	Gases, petroleum, catalytic cracking	68783-64-2	Contains (regardless of intentional or impurities)	chemical products
1533	Gases, petroleum, C2-4, sweetened	68783-65-3	Contains (regardless of intentional or impurities)	chemical products
1534	Naphtha, petroleum, light, sweetened	68783-66-4	Contains (regardless of intentional or impurities)	chemical products
1535	Sulfonic acids, petroleum, calcium salts, overbased	68783-96-0	Intentional addition / 1,000ppm	chemical products
1536	Aluminum gallium magnesium oxide (Al,Ga)2MgO4, manganese-doped	68784-02-1	Contains (regardless of intentional or impurities)	chemical products
1537	Cadmium zinc sulfide ((Cd,Zn)S), aluminum and cobalt and copper and silver-doped	68784-10-1	Contains (regardless of intentional or impurities)	chemical products
1538	Germanium magnesium fluoride oxide, manganese-doped	68784-13-4	Contains (regardless of intentional or impurities)	chemical products
1539	Magnesate(1-), trifluoro-, potassium, manganese and zinc-doped	68784-19-0	Contains (regardless of intentional or impurities)	chemical products
1540	Yttrium oxide (Y2O3), europium and terbium-doped	68784-54-3	Intentional addition / 1%	chemical products
1541	Barium cadmium calcium chloride fluoride phosphate, antimony and manganese-doped	68784-55-4	Contains (regardless of intentional or impurities)	chemical products
1542	Cadmium borate oxide (Cd3(BO2)4O), manganese-doped	68784-58-7	Contains (regardless of intentional or impurities)	chemical products
1543	Chromic acid (H2CrO7), disodium salt, reaction products with [1R-[1.alpha.(R*)2.beta.4.alpha.beta.8.alpha.]alpha-ethylenedecahydro-2-hydroxy-]alpha-2,5,5,8a-pentamethyl-1-naphthalenepropanol, hydrogenated	68784-60-1	Contains (regardless of intentional or impurities)	chemical products
1544	Strontium fluoride phosphate (SrF5(PO4)3), antimony and manganese-doped	68784-78-1	Contains (regardless of intentional or impurities)	chemical products
1545	Yttrium borate phosphate vanadate, europium-doped	68784-82-7	Intentional addition / 1%	chemical products
1546	Yttrium oxide sulfide (Y2O2S), europium-doped	68784-83-8	Intentional addition / 1%	chemical products
1547	Zinc sulfide (ZnS), copper and nickel and silver-doped	68784-84-9	Contains (regardless of intentional or impurities)	chemical products
1548	Boric acid (H3BO3), compound with 2-aminoethanol (1:3)	68797-44-4	Intentional addition / 1%	chemical products
1549	Cobalt(2+), hexakis(5-phenyl-1,3,4-oxadiazol-2-amine-N2)-, (OC-6-11)-	68811-50-7	Intentional addition / 1%	chemical products
1550	Sulfuric acid, zinc salt, basic	68813-94-5	Intentional addition / 25%	chemical products
1551	Gases, petroleum, refinery	68814-67-5	Contains (regardless of intentional or impurities)	chemical products
1552	Extracts, petroleum, heavy paraffinic distillates, solvent-deasphalted	68814-89-1	Contains (regardless of intentional or impurities)	chemical products
1553	Gases, petroleum, platformer products separator off	68814-90-4	Contains (regardless of intentional or impurities)	chemical products
1554	Naphthenic acids, vanadium salts	68815-09-8	Intentional addition / 1%	chemical products
1555	Tar acids, cresylic, sodium salts, alkaline solution	68815-21-4	Contains (regardless of intentional or impurities)	chemical products
1556	Phenol, thiobis(dodecyl)-, barium salt (1:1)	68832-80-4	Contains (regardless of intentional or impurities)	chemical products
1557	Iron, [N,N-bis(2-hydroxy-5-sulphophenyl)methyl]glycinato(3-)]-	68833-87-4	Intentional addition / 1%	chemical products
1558	Copper(2+), tetraamine-, carbonate hydroxide (2:1:2)	68833-88-5	Intentional addition / 1,000ppm	chemical products
1559	Chromate(3-), bis[5-chloro-3-[[1-(2-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(3-)]-, trihydrogen	68833-89-6	Contains (regardless of intentional or impurities)	chemical products
1560	Chromate(3-), bis[4-[[1-(2,5-dichlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, trihydrogen	68833-90-9	Contains (regardless of intentional or impurities)	chemical products
1561	Ferrocene, ethyl-, polymer with 2-propanone	68834-18-4	Intentional addition / 1%	chemical products
1562	Sodium [[N,N'-propane-1,3-diybis[N-[(2-hydroxyphenyl)methyl]glycinato]](4)-N,N',O,O',ON,ON]ferrate(1-)	68834-38-8	Intentional addition / 1%	chemical products
1563	Benzyltriethylammonium permanganate	68844-25-7	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
14624	Benzenamine, 4,4'-carbonimidoylbis[N,N-dimethyl-, compound with molybdenum tungsten hydroxide oxide phosphate	68845-37-4	Intentional addition / 1%	chemical products
14625	Benzenamine, 4-[[4-(4-aminophenyl)(4-imino-2,5-cyclohexadien-1-ylidene)methyl]-2-methyl-, compound with molybdenum hydroxide oxide phosphate	68845-38-5	Intentional addition / 1%	chemical products
14626	Nickel alloy, base, Ni 90-99 Sn 0.8-10	68849-07-0	Contains (regardless of intentional or impurities)	chemical products
14627	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [(2-aminoethyl)amino]sulfonyl sulfo derivatives	68855-30-1	Intentional addition / 1,000ppm	chemical products
14628	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [(3-phosphonophenyl)amino]sulfonyl sulfo derivatives, sodium salts	68855-31-2	Intentional addition / 1,000ppm	chemical products
14629	Ferrocene, reaction products with boron trifluoride and [1S-(1.alpha.,3a.beta.,4.alpha.,8a.beta.)]-decahydro-4,8,8-trimethyl-9-methylene-1,4-methanoazulene	68855-38-9	Contains (regardless of intentional or impurities)	chemical products
14630	Kieselguhr, soda ash flux-calcined	68855-54-9	Intentional addition / 1,000ppm	chemical products
14631	Fatty acids, tall-oil, barium salts	68855-79-8	Intentional addition / 1,000ppm	chemical products
14632	Fatty acids, tall-oil, cadmium salts	68855-80-1	Contains (regardless of intentional or impurities)	chemical products
14633	Fatty acids, tall-oil, hydrogenated, cobalt salts	68855-86-7	Intentional addition / 1%	chemical products
14634	C.I. Pigment Yellow 37	68859-25-6	Contains (regardless of intentional or impurities)	chemical products
14635	1-Tridecanol, zirconium(4+) salt	68862-34-0	Contains (regardless of intentional or impurities)	chemical products
14636	Fatty acids, C8-18 and C18-unsaturated, barium salts	68876-83-5	Intentional addition / 1,000ppm	chemical products
14637	Fatty acids, C8-18 and C18-unsaturated, cadmium salts	68876-84-6	Contains (regardless of intentional or impurities)	chemical products
14638	Fatty acids, C6-12, barium salts	68876-86-8	Intentional addition / 1,000ppm	chemical products
14639	Barium cadmium zinc sulfide (Ba2(Cd,Zn)S3), manganese-doped	68876-90-4	Contains (regardless of intentional or impurities)	chemical products
14640	Barium chloride fluoride (BaClF), europium-doped	68876-91-5	Contains (regardless of intentional or impurities)	chemical products
14641	Barium zinc sulfide (Ba2ZnS3), manganese-doped	68876-92-6	Contains (regardless of intentional or impurities)	chemical products
14642	Cadmium sulfide (CdS), aluminum and copper-doped	68876-98-2	Contains (regardless of intentional or impurities)	chemical products
14643	Cadmium sulfide (CdS), aluminum and silver-doped	68876-99-3	Contains (regardless of intentional or impurities)	chemical products
14644	Cadmium sulfide (CdS), copper chloride-doped	68877-00-9	Contains (regardless of intentional or impurities)	chemical products
14645	Cadmium sulfide (CdS), silver chloride-doped	68877-01-0	Contains (regardless of intentional or impurities)	chemical products
14646	Zinc sulfide (ZnS), manganese-doped	68877-27-0	Contains (regardless of intentional or impurities)	chemical products
14647	Barium titanium oxide (Ba4Ti1O26)	68879-75-4	Intentional addition	chemical products
14648	Chromium, diquatetrachloro.mu.-[N-ethyl-N-[(heptafluorooctyl)sulfonyl]glycinato-O1,O1']]-mu.-hydroxybis(2-methylpropano)di-	68891-96-3	Contains (regardless of intentional or impurities)	chemical products
14649	Chromium, diquatetrachloro.mu.-[N-ethyl-N-[(pentadecafluoroheptyl)sulfonyl]glycinato-O1,O1']]-mu.-hydroxybis(2-propano)di-	68891-97-4	Contains (regardless of intentional or impurities)	chemical products
14650	Chromium, diquatetrachloro.mu.-[N-ethyl-N-[(tridecafluoroheptyl)sulfonyl]glycinato-O1,O1']]-mu.-hydroxybis(2-propano)di-	68891-98-5	Contains (regardless of intentional or impurities)	chemical products
14651	Chromium, diquatetrachloro.mu.-[N-ethyl-N-[(undecafluoropentyl)sulfonyl]glycinato-O1,O1']]-mu.-hydroxybis(2-propano)di-	68891-99-6	Contains (regardless of intentional or impurities)	chemical products
14652	Boron(1+), bis(2,4-pentanedionato-O,O')-, (T-4)-, hexafluoroarsenate(1-)	68892-01-3	Contains (regardless of intentional or impurities)	chemical products
14653	Chromate(2-), [2-[[4-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]-[4-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, disodium	68900-70-9	Contains (regardless of intentional or impurities)	chemical products
14654	Chromium, [4-[[4-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-N,N-bis(2-hydroxyethyl)-1-naphthalenesulfonamido(2-)]-[2-[[3-(2,5-dihydroxyphenyl)-1-oxopropyl]cyclopentanonato]-	68900-71-0	Contains (regardless of intentional or impurities)	chemical products
14655	Chromium(1+), [4-[[4-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-N,N-bis(2-hydroxyethyl)-1-naphthalenesulfonamido(2-)]-, chloride	68900-72-1	Intentional addition / 1,000ppm	chemical products
14656	Chromium, diquatetrachloro.mu.-[N-ethyl-N-[(nonafluorobutyl)sulfonyl]glycinato-O1,O1']]-mu.-hydroxybis(2-propano)di-	68900-97-0	Intentional addition / 1,000ppm	chemical products
14657	2-Propanoic acid, 1,3-propanediylbis(oxy-3,1-propanediyl) ester	68901-05-3	Intentional addition / 1,000ppm	chemical products
14658	Thorium yttrium oxide	68908-48-5	Intentional addition / 1%	chemical products
14659	Gadolinium yttrium oxide sulfide ((Gd,Y)2O2S), europium-doped	68908-71-4	Intentional addition / 1%	chemical products
14660	Calcium strontium sulfide ((Ca,Sr)S), bismuth and copper-doped	68908-94-1	Intentional addition / 1,000ppm	chemical products
14661	Zirconium, acetate lactate oxo ammonium complexes	68909-34-2	Contains (regardless of intentional or impurities)	chemical products
14662	Chromium, 3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonate 1-[(2-hydroxynitrophenyl)azo]-2-naphthalenol complexes	68909-42-2	Intentional addition / 1,000ppm	chemical products
14663	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [2-[[4,6-dichloro-1,3,5-triazin-2-yl]amino]ethylamino sulfo derivatives, sodium salts	68909-43-3	Intentional addition / 1,000ppm	chemical products
14664	Copper, [tris(chloromethyl)-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, reaction products with poly(hydroxyoctadecanoic acid)	68909-44-4	Intentional addition / 1,000ppm	chemical products
14665	Hematite, chromium green black	68909-79-5	Contains (regardless of intentional or impurities)	chemical products
14666	Sulfite liquors and Cooking liquors, spent, alkali-sulfur dioxide-treated, chromium salts	68910-42-9	Intentional addition / 1,000ppm	chemical products
14667	Sulfite liquors and Cooking liquors, spent, alkali-sulfur dioxide-treated, zinc salts	68910-44-1	Intentional addition / 25%	chemical products
14668	Chromium, depolymerized glue complexes	68911-01-3	Intentional addition / 1,000ppm	chemical products
14669	Greensand, manganese sodium	68911-03-5	Contains (regardless of intentional or impurities)	chemical products
14670	Gases, petroleum, hydrotreated sour kerosene depentanizer stabilizer off	68911-58-0	Contains (regardless of intentional or impurities)	chemical products
14671	Gases, petroleum, hydrotreated sour kerosene flash drum	68911-59-1	Contains (regardless of intentional or impurities)	chemical products
14672	Nickel, bis(2-heptadecyl-1H-imidazole-N3)bis(octanoato-O)-	68912-08-3	Contains (regardless of intentional or impurities)	chemical products
14673	Chromate(5-), [6-(acetylamino)-4-hydroxy-3-[(2-hydroxy-5-nitro-3-sulfonylphenyl)azo]-2-naphthalenesulfonato(4-)]-[4-hydroxy-6-[(2-hydroxy-5-methylphenyl)azo]-3-[(2-hydroxy-5-nitro-3-sulfonylphenyl)azo]-2-naphthalenesulfonato(4-)]-, pentahydrogen	68912-09-4	Contains (regardless of intentional or impurities)	chemical products
14674	Chromate(5-), [6-(acetylamino)-4-hydroxy-3-[(2-hydroxy-3-nitro-5-sulfonylphenyl)azo]-2-naphthalenesulfonato(4-)]-[4-hydroxy-6-[(2-hydroxy-5-methylphenyl)azo]-3-[(2-hydroxy-5-nitro-3-sulfonylphenyl)azo]-2-naphthalenesulfonato(4-)]-, pentahydrogen	68912-10-7	Contains (regardless of intentional or impurities)	chemical products
14675	Chromate(5-), [6-(acetylamino)-4-hydroxy-3-[(2-hydroxy-5-nitro-3-sulfonylphenyl)azo]-2-naphthalenesulfonato(4-)]-[4-hydroxy-6-[(2-hydroxy-5-methylphenyl)azo]-3-[(2-hydroxy-3-nitro-5-sulfonylphenyl)azo]-2-naphthalenesulfonato(4-)]-, pentahydrogen	68912-11-8	Contains (regardless of intentional or impurities)	chemical products
14676	Cuprate(4-), [2-[[[3-[[4-fluoro-6-[[3-sulfonylphenylamino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulfonylphenyl]phenylmethyl]azo]-4-sulfobenzoato(6-)]-, tetrasodium	68912-12-9	Intentional addition / 1,000ppm	chemical products
14677	Balsams, Douglas-fir, sulfurized, rhodium salts	68916-30-3	Intentional addition / 1%	chemical products
14678	Zeolites, calcium-iron-magnesium-vanadium-containing (A complex silicate. Contains primarily calcium, iron, magnesium, and vanadium salts).	68918-02-5	Intentional addition / 1%	chemical products
14679	Siloxanes and Silicones, dimethyl, polymers with zirconium octanoate	68918-33-2	Contains (regardless of intentional or impurities)	chemical products
14680	Resin acids and Rosin acids, chromium salts	68918-74-1	Intentional addition / 1,000ppm	chemical products
14681	Gases, petroleum, crude oil fractionation off	68918-99-0	Contains (regardless of intentional or impurities)	chemical products
14682	Gases, petroleum, dehexanizer off	68919-00-6	Contains (regardless of intentional or impurities)	chemical products
14683	Gases, petroleum, distillate unifier desulfurization stripper off	68919-01-7	Contains (regardless of intentional or impurities)	chemical products
14684	Gases, petroleum, fluidized catalytic cracker fractionation off	68919-02-8	Contains (regardless of intentional or impurities)	chemical products
14685	Gases, petroleum, fluidized catalytic cracker scrubbing secondary absorber off	68919-03-9	Contains (regardless of intentional or impurities)	chemical products
14686	Gases, petroleum, heavy distillate hydrotreater desulfurization stripper off	68919-04-0	Contains (regardless of intentional or impurities)	chemical products
14687	Gases, petroleum, light straight run gasoline fractionation stabilizer off	68919-05-1	Contains (regardless of intentional or impurities)	chemical products
14688	Gases, petroleum, naphtha unifier desulfurization stripper off	68919-06-2	Contains (regardless of intentional or impurities)	chemical products
14689	Gases, petroleum, platformer stabilizer off, light ends fractionation	68919-07-3	Contains (regardless of intentional or impurities)	chemical products
14690	Gases, petroleum, preflash tower off, crude distillation	68919-08-4	Contains (regardless of intentional or impurities)	chemical products
14691	Gases, petroleum, straight-run naphtha catalytic reforming off	68919-09-5	Contains (regardless of intentional or impurities)	chemical products
14692	Gases, petroleum, straight-run stabilizer off	68919-10-8	Contains (regardless of intentional or impurities)	chemical products
14693	Gases, petroleum, tar stripper off	68919-11-9	Contains (regardless of intentional or impurities)	chemical products
14694	Gases, petroleum, unifier stripper off	68919-12-0	Contains (regardless of intentional or impurities)	chemical products
14695	Gases, petroleum, fluidized catalytic cracker splitter overheads	68919-20-0	Contains (regardless of intentional or impurities)	chemical products
14696	Naphtha, petroleum, full-range reformed	68919-37-9	Contains (regardless of intentional or impurities)	chemical products
14697	Natural gas condensates	68919-39-1	Contains (regardless of intentional or impurities)	chemical products
14698	Distillates, petroleum, light straight-run gasoline fractionation stabilizer overheads	68921-08-4	Contains (regardless of intentional or impurities)	chemical products
14699	Distillates, petroleum, naphtha unifier stripper	68921-09-5	Contains (regardless of intentional or impurities)	chemical products
14700	Benzenamine, N-phenyl-, reaction products with styrene and 2,4,4-trimethylpentene	68921-45-9	Intentional addition / 100ppm	chemical products
14701	Copper, 3-hydroxy-4-[[2-(methoxy-4-nitrophenyl)azo]-2-naphthalenecarboxylate complexes	68921-55-1	Intentional addition / 1,000ppm	chemical products
14702	Spinel, aluminum chromium magnesium, mixed with periclase	68921-68-6	Intentional addition / 1,000ppm	chemical products
14703	2,lambda2-1,3,2-Dioxastannolane	68921-71-1	Contains (regardless of intentional or impurities)	chemical products
14704	Silicon(1+), tris(2-acetylcylohexanonato-O,O')-, (OC-6-11)-hexafluoroantimonate(1-)	68921-97-1	Contains (regardless of intentional or impurities)	chemical products
14705	Chromate(5-), [6-(acetylamino)-4-hydroxy-3-[(2-hydroxy-3-nitro-5-sulfonylphenyl)azo]-2-naphthalenesulfonato(4-)]-[6-(acetylamino)-4-hydroxy-3-[(2-hydroxy-5-nitro-3-sulfonylphenyl)azo]-2-naphthalenesulfonato(4-)]-, pentahydrogen	68922-28-1	Contains (regardless of intentional or impurities)	chemical products
14706	Oxobis(propanoato-O)zirconium	68926-31-8	Contains (regardless of intentional or impurities)	chemical products
14707	Aurate(1-), tetrachloro-, hydrogen, (SP-4-1)-, reaction products with ammonium thiocyanate	68927-42-4	Intentional addition	chemical products
14708	1-Octadecanaminium, N,N-diethyl-N-methyl-, (OC-6-11)-hexakis(cyano-O)ferrate(4-)(4:1)	68928-29-0	Contains (regardless of intentional or impurities)	chemical products
14709	Platinum, dichloro(N,N-dimethyl-1-octadecanamine)(tributylphosphine)-	68928-30-3	Contains (regardless of intentional or impurities)	chemical products
14710	Cobaltate(2-), [2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-N-(2-ethylhexyl)-3-oxobutanimidato(2-)]-[4-[[1-(2-hydroxy-3,5-dinitrophenyl)azo]-2-naphthalenyl]amino]benzenesulfonato(3-)]-, dipotassium	68928-31-4	Intentional addition / 1,000ppm	chemical products
14711	Tetradecanoic acid, (butylstannylidene)tris(thio-2,1-ethanedyl) ester	68928-34-7	Contains (regardless of intentional or impurities)	chemical products
14712	9,12-Octadecadienoic acid (Z,Z)-, (butylstannylidene)tris(thio-2,1-ethanedyl) ester	68928-37-0	Contains (regardless of intentional or impurities)	chemical products
14713	Tetradecanoic acid, (methylstannylidene)tris(thio-2,1-ethanedyl) ester	68928-38-1	Contains (regardless of intentional or impurities)	chemical products
14714	Hexadecanoic acid, (butylstannylidene)tris(thio-2,1-ethanedyl) ester	68928-39-2	Contains (regardless of intentional or impurities)	chemical products
14715	9,12-Octadecadienoic acid (Z,Z)-, (methylstannylidene)tris(thio-2,1-ethanedyl) ester	68928-40-5	Contains (regardless of intentional or impurities)	chemical products
14716	Hexadecanoic acid, (methylstannylidene)tris(thio-2,1-ethanedyl) ester	68928-41-6	Contains (regardless of intentional or impurities)	chemical products
14717	Dodecanoic acid, (dimethylstannylidene)bis(thio-2,1-ethanedyl) ester	68928-42-7	Contains (regardless of intentional or impurities)	chemical products
14718	D-Glucitol, 1,1',1''-[3,3',3''-(methylstannylidene)tris(thio)tris(propanoate)]	68928-44-9	Contains (regardless of intentional or impurities)	chemical products
14719	Decanoic acid, (dibutylstannylidene)bis(thio-2,1-ethanedyl) ester	68928-47-2	Contains (regardless of intentional or impurities)	chemical products
14720	Tetradecanoic acid, (dimethylstannylidene)bis(thio-2,1-ethanedyl) ester	68928-48-3	Contains (regardless of intentional or impurities)	chemical products
14721	Hexadecanoic acid, (dimethylstannylidene)bis(thio-2,1-ethanedyl) ester	68928-49-4	Contains (regardless of intentional or impurities)	chemical products
14722	Decanoic acid, (methylstannylidene)tris(thio-2,1-ethanedyl) ester	68928-50-7	Contains (regardless of intentional or impurities)	chemical products
14723	Dodecanoic acid, (butylstannylidene)tris(thio-2,1-ethanedyl) ester	68928-52-9	Contains (regardless of intentional or impurities)	chemical products
14724	2,7-Naphthalenedisulfonic acid, 4-[(2,4-dimethylphenyl)azo]-3-hydroxy-, barium salt (1:1)	68928-54-1	Contains (regardless of intentional or impurities)	chemical products
14725	Stannane, dimethylbis(1-oxooxocetyl)oxy-	68928-76-7	Contains (regardless of intentional or impurities)	chemical products
14726	1,2-Benzenedicarboxylic acid, (dibutylstannylidene)bis(thio-2,1-ethanedyl) diisocetyl ester	68928-78-9	Contains (regardless of intentional or impurities)	chemical products
14727	1,7-Naphthalenedisulfonic acid, 4-(benzylamino)-5-hydroxy-6-[(3-methylphenyl)azo]-, barium sodium salt (1:1:2)	68929-13-5	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
14728	1,7-Naphthalenedisulfonic acid, 4-[[2-(4-dichlorobenzoylamino)-5-hydroxy-6-[[2-methoxyphenyl]azo]-, barium sodium salt (1:1:2)	68929-14-6	Contains (regardless of intentional or impurities)	chemical products
14729	Silicon(1+), tris(3-chloro-2,4-pentanedionato-O,O')-, (OC-6-11)-, (OC-6-11)-hexafluoroantimonate(1-)	68933-55-1	Contains (regardless of intentional or impurities)	chemical products
14730	Butanedioic acid, 2,3-bis(4-methylbenzoyloxy)-, [[S-(R*,R*)]-, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	68935-25-1	Contains (regardless of intentional or impurities)	chemical products
14731	Butanedioic acid, 2,3-bis(4-methylbenzoyloxy)-, [[R-(R*,R*)]-, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	68935-26-2	Contains (regardless of intentional or impurities)	chemical products
14732	Acetic acid, anhydride, reaction products with antimony oxide (Sb2O3) and ethylene glycol	68937-04-2	Contains (regardless of intentional or impurities)	chemical products
14733	Ethanedioic acid, reaction products with barium chloride and titanium tetrachloride	68937-19-9	Contains (regardless of intentional or impurities)	chemical products
14734	1,2-Ethanedioic acid, reaction products with antimony oxide (Sb2O3)	68937-20-2	Contains (regardless of intentional or impurities)	chemical products
14735	Phenol, isopropylated, phosphate (3:1)	68937-41-7	Intentional addition / 1,000ppm	chemical products
14736	Zirconium oxide (ZrO2), lime stabilized	68937-53-1	Contains (regardless of intentional or impurities)	chemical products
14737	Extract oils, coal, tar base, collidine fraction	68937-63-3	Contains (regardless of intentional or impurities)	chemical products
14738	Chromium alloy, base, Cr-52-72, Fe-17-31, Si-3-14, C-4-9.5 (ASTM A101-HIGH CARBON)	68938-87-4	Intentional addition / 1,000ppm	chemical products
14739	Platinum bromide (PtBr4)	68938-92-1	Contains (regardless of intentional or impurities)	chemical products
14740	Formaldehyde, polymer with tin chloride (SnCl2) and 1,3,5-triazine-2,4,6-triamine	68938-97-6	Contains (regardless of intentional or impurities)	chemical products
14741	Antimony oxide (Sb2O3), mixed with arsenic oxide (As2O3)	68951-38-2	Contains (regardless of intentional or impurities)	chemical products
14742	Alcohols, C14-15, ethoxylated	68951-67-7	Intentional addition / 1%	chemical products
14743	Gases, petroleum, catalytic cracked naphtha debutanizer	68952-76-1	Contains (regardless of intentional or impurities)	chemical products
14744	Tail gas, petroleum, catalytic cracked distillate and naphtha stabilizer	68952-77-2	Contains (regardless of intentional or impurities)	chemical products
14745	Tail gas, petroleum, catalytic hydrodesulfurized naphtha separator	68952-79-4	Contains (regardless of intentional or impurities)	chemical products
14746	Tail gas, petroleum, straight-run naphtha hydrodesulfurizer	68952-80-7	Contains (regardless of intentional or impurities)	chemical products
14747	Tail gas, petroleum, thermal-cracked distillate, gas oil and naphtha absorber	68952-81-8	Contains (regardless of intentional or impurities)	chemical products
14748	Tail gas, petroleum, thermal cracked hydrocarbon fractionation stabilizer, petroleum coking	68952-82-9	Contains (regardless of intentional or impurities)	chemical products
14749	Fatty acids, tallow, hydrogenated, barium salts	68953-38-8	Intentional addition / 1,000ppm	chemical products
14750	Fatty acids, tallow, hydrogenated, cadmium salts	68953-39-9	Contains (regardless of intentional or impurities)	chemical products
14751	Quaternary ammonium compounds, bis(hydrogenated tallow alkyl)dimethyl, salts with bentonite	68953-58-2	Intentional addition / 100ppm	chemical products
14752	Antimony, 2-ethylhexanoate neodecanoate complexes	68953-72-0	Contains (regardless of intentional or impurities)	chemical products
14753	1,4-Benzenediamine, N,N'-mixed phenyl and tolyl and xylyl derivatives	68953-83-3	Intentional addition / 100ppm	chemical products
14754	Benzenesulfonic acid, mono-C9-17-alkyl derivatives, sodium salts	68953-95-7	Intentional addition / 1%	chemical products
14755	Boric acid, polymer with 1,2-ethanediol, reaction products with borax	68954-06-3	Intentional addition / 1%	chemical products
14756	Cadmium, laurate palmitate stearate complexes	68954-18-7	Contains (regardless of intentional or impurities)	chemical products
14757	Chromium, glycolate aluminum complexes	68954-19-8	Intentional addition / 1,000ppm	chemical products
14758	Copper, 2-ethylhexanoate tall-oil fatty acid complexes	68954-20-1	Intentional addition / 1,000ppm	chemical products
14759	Molybdenum, bis(2-ethylhexyl)carbamodithioate bis(2-ethylhexyl)carbamothioate oxo thioxo complexes	68954-53-0	Intentional addition / 1%	chemical products
14760	Neodecanoic acid, reaction products with antimony oxide (Sb2O3)	68954-54-1	Contains (regardless of intentional or impurities)	chemical products
14761	2-Propenoic acid, butyl ester, homopolymer, reaction products with dioctyloxostannane	68955-07-7	Contains (regardless of intentional or impurities)	chemical products
14762	Aluminum oxide (Al2O3), high-temperature fusion-reduction products with zirconium oxide (ZrO2)	68955-26-0	Contains (regardless of intentional or impurities)	chemical products
14763	Distillates, petroleum, petroleum residues vacuum	68955-27-1	Contains (regardless of intentional or impurities)	chemical products
14764	Gases, petroleum, light steam-cracked, butadiene concentrate	68955-28-2	Contains (regardless of intentional or impurities)	chemical products
14765	Distillates, petroleum, light thermal cracked, debutanized aromatic	68955-29-3	Contains (regardless of intentional or impurities)	chemical products
14766	Gases, petroleum, sponge absorber off, fluidized catalytic cracker and gas oil desulfurizer overhead fractionation	68955-33-9	Contains (regardless of intentional or impurities)	chemical products
14767	Gases, petroleum, straight-run naphtha catalytic reformer stabilizer overhead	68955-34-0	Contains (regardless of intentional or impurities)	chemical products
14768	Naphtha, petroleum, catalytic reformed	68955-35-1	Contains (regardless of intentional or impurities)	chemical products
14769	Residues, petroleum, steam-cracked, resinous	68955-36-2	Contains (regardless of intentional or impurities)	chemical products
14770	Alkanes, C10-18, bromochloro-	68955-41-9	Intentional addition / 900ppm	chemical products
14771	Amines, C12-18-alkyldimethyl, N-oxides	68955-55-5	Intentional addition / 1%	chemical products
14772	Barium, laurate palmitate stearate complexes	68955-79-3	Intentional addition / 1,000ppm	chemical products
14773	Fatty acids, C9-13-meo-, cobalt salts	68956-83-9	Intentional addition / 1,000ppm	chemical products
14774	Resin acids and Rosin acids, cadmium salts	68956-81-0	Contains (regardless of intentional or impurities)	chemical products
14775	Resin acids and Rosin acids, cobalt salts	68956-82-1	Contains (regardless of intentional or impurities)	chemical products
14776	Rosin sulfonized, antimony salt	68956-96-7	Contains (regardless of intentional or impurities)	chemical products
14777	Resin acids and Rosin acids, uranyl salts	68956-97-8	Intentional addition / 1,000ppm	chemical products
14778	Antimony, 4-[[4-aminophenyl(4-imino-2,5-cyclohexadien-1-ylidene)methyl]-2-methylbenzamine tannin complexes	68957-23-3	Contains (regardless of intentional or impurities)	chemical products
14779	Heptanoic acid, chromium(3+) salt	68957-69-7	Intentional addition / 1,000ppm	chemical products
14780	Silicic acid (H4SiO4), tetraethyl ester, polymer with arsenic oxide (As2O3)	68957-75-5	Contains (regardless of intentional or impurities)	chemical products
14781	Neodecanoic acid, iron(3+) salt	68958-52-1	Intentional addition / 1%	chemical products
14782	Platinum, dichlorobis(2,4-pentanedionato-O,O')-	68958-84-9	Contains (regardless of intentional or impurities)	chemical products
14783	Platinatate(2-), bis(nitro-N)bis(sulfato(2-O)-), dihydrogen	68958-85-0	Contains (regardless of intentional or impurities)	chemical products
14784	Nickelate(6-), [[[[1,2-ethanediybis(nitrilo-kappa N)bis(methylene)]tetrakis[phosphonato-kappa O]](8-)]-, ammonium hydrogen (1.5:1), (OC-6-21)-	68958-86-1	Contains (regardless of intentional or impurities)	chemical products
14785	Nickelate(6-), [[[[1,2-ethanediybis(nitrilobis(methylene)]tetrakis[phosphonato]](8-)], pentapotassium hydrogen, (OC-6-21)-	68958-87-2	Contains (regardless of intentional or impurities)	chemical products
14786	Nickelate(6-), [[[[1,2-ethanediybis(nitrilobis(methylene)]tetrakis[phosphonato]](8-)], pentasodium hydrogen, (OC-6-21)-	68958-88-3	Contains (regardless of intentional or impurities)	chemical products
14787	Nickel(2+), bis(1,2-ethanediamine-N,N)-, bis[bis(cyano-O)aurate(1-)]	68958-89-4	Contains (regardless of intentional or impurities)	chemical products
14788	Cobalt(2+), bis(1,2-ethanediamine-N,N)-, bis[bis(cyano-O)aurate(1-)]	68958-90-7	Contains (regardless of intentional or impurities)	chemical products
14789	Copper, dichloro(1,4-diazabicyclo[2.2.2]octane-N1)-	68958-91-8	Intentional addition / 1,000ppm	chemical products
14790	Bis(O,O-bis(2-ethylhexyl)dithiophosphorato-S,S')dioxodi-mu-thioxodimolybdenum	68958-92-9	Contains (regardless of intentional or impurities)	chemical products
14791	Chromate(1-), bis[N-(7-hydroxy-8-[[2-hydroxy-5-[[2-hydroxy-5-sulfophenyl]phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, hydrogen, compound with 2-propanamine (1:1)	68958-96-3	Contains (regardless of intentional or impurities)	chemical products
14792	Chromate(1-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamidato(2-)]-, hydrogen, compound with 2-propanamine (1:1)	68959-93-0	Contains (regardless of intentional or impurities)	chemical products
14793	2,7-Naphthalenedisulfonic acid, 4-[[5-chloro-4-methyl-2-sulfonylphenyl]azo]-3-hydroxy-, barium salt (2:3)	68959-10-4	Contains (regardless of intentional or impurities)	chemical products
14794	Ferrate(2-), tetracarbonyl-, (T-4)-, disodium, compound with 1,4-dioxane (1:1)	68964-18-1	Intentional addition / 1%	chemical products
14795	2,7-Naphthalenedisulfonic acid, 3,3'-[[3,3'-dimethoxy(1,1'-biphenyl)-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-, sodium salt, compound with 2,2'-iminobis[ethanol]	68966-43-8	Intentional addition	chemical products
14796	2,7-Naphthalenedisulfonic acid, 3,3'-[[3,3'-dimethoxy(1,1'-biphenyl)-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-, sodium salt	68966-50-7	Intentional addition	chemical products
14797	Chromate(1-), bis[N-(7-hydroxy-8-[[2-hydroxy-5-[[methylamino]sulfonyl]phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, sodium	68966-87-0	Contains (regardless of intentional or impurities)	chemical products
14798	Chromate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamidato(2-)]-[N-(7-hydroxy-8-[[2-hydroxy-5-[[methylamino]sulfonyl]phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, sodium	68966-88-1	Contains (regardless of intentional or impurities)	chemical products
14799	Cuprate(3-), [5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonate(5-)]-, trisodium	68966-89-2	Intentional addition / 1,000ppm	chemical products
14800	Cuprate(4-), [2-[[2-[[2-[[2-hydroxy-3-[[2-hydroxy-5-sulfonyl]phenyl]azo]-2-sulfonyl]ethenyl]-5-[[4-[[4-sulfonyl]phenyl]azo]phenyl]azo]benzenesulfonate(6-)]-, tetrasodium	68966-90-5	Intentional addition / 1,000ppm	chemical products
14801	Chromate(1-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamidato(2-)]-, sodium	68966-92-7	Contains (regardless of intentional or impurities)	chemical products
14802	Chromate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamidato(2-)]-[N-(7-hydroxy-8-[[2-hydroxy-5-[[methylamino]sulfonyl]phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, hydrogen, compound with 2-propanamine (1:1)	68966-94-9	Contains (regardless of intentional or impurities)	chemical products
14803	Cobaltate(1-), bis[N-8-[[5-[[aminosulfonyl]-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]acetamidato(2-)]-, sodium	68966-95-0	Intentional addition / 1,000ppm	chemical products
14804	Cobaltate(1-), [N-8-[[5-[[aminosulfonyl]-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]acetamidato(2-)]-[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, sodium	68966-96-1	Intentional addition / 1,000ppm	chemical products
14805	Cadmiate(1-), [4-[[5-chloro-4-methyl-2-sulfonyl]phenyl]azo]-3-hydroxy-2-naphthalenecarboxylate(3-)]-, hydrogen	68966-97-2	Contains (regardless of intentional or impurities)	chemical products
14806	Cobaltate(1-), bis[2-[[2-amino-1-naphthalenyl]azo]-5-nitrophenolato(2-)]-, sodium	68966-98-3	Intentional addition / 1,000ppm	chemical products
14807	Chromate(1-), [2-[[4,5-dihydro-3-methyl-1-(2-methyl-4-sulfonylphenyl)-5-oxo-1H-pyrazol-4-yl]azo]-4-sulfobenzoate(4-)]-, hydrogen	68966-99-4	Contains (regardless of intentional or impurities)	chemical products
14808	Cuprate(2-), [C-[[[3-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-sulfonyl]amino]sulfonyl]-C-(aminosulfonyl)-29H.31H-phthalocyanine-C-sulfonate(4)-N29.N30.N31.N32]-, disodium	68967-01-1	Intentional addition / 1,000ppm	chemical products
14809	Cuprate(2-), [C,C-bis[[[4-[[bis(3-amino-3-oxopropyl)amino]sulfonyl]phenyl]amino]sulfonyl]-29H.31H-phthalocyanine-C-C-disulfonate(4)-N29.N30.N31.N32]-, disodium	68967-02-2	Intentional addition / 1,000ppm	chemical products
14810	2-Butenoic acid, 4,4'-[[1,1,3,3-tetraethyl-1,3-distannoxanediyl]bis(4-oxo-, diisocetyl ester	68974-77-6	Contains (regardless of intentional or impurities)	chemical products
14811	Copper(1+), (thioureato-S)-, bis(cyano-C)aurate(1-)	68975-64-4	Contains (regardless of intentional or impurities)	chemical products
14812	Copper(2+), [2,2',2''-(1,2-ethanediyldinitrilo)tetrakis[2-propanol-N,N',O',O',O'']-, (OC-6-21)-, sulfate (1:1)	68975-66-6	Intentional addition / 1,000ppm	chemical products
14813	Borate(1-), tetrafluoro-, potassium, reaction products with boric acid and potassium fluoride (KHF2)	68987-54-2	Contains (regardless of intentional or impurities)	chemical products
14814	Borate(1-), tetrafluoro-, potassium, reaction products with boric acid, boron, boron potassium oxide (B4K2O7) and potassium fluoride (KHF2)	68987-55-3	Intentional addition / 1%	chemical products
14815	Boron, reaction products with boron potassium oxide (B4K2O7) and potassium fluoride (KHF2)	68987-56-4	Contains (regardless of intentional or impurities)	chemical products
14816	Copper, [29H.31H-phthalocyaninato(2-)-N29.N30.N31.N32]-, [[2-[[2-aminoethyl]amino]ethyl]amino]sulfonyl sulfo derivatives	68987-61-1	Intentional addition / 1,000ppm	chemical products
14817	Copper, [29H.31H-phthalocyaninato(2-)-N29.N30.N31.N32]-, [[2-[[2-aminoethyl]amino]ethyl]amino]sulfonyl sulfo derivatives, acetates methanesulfonates	68987-62-2	Intentional addition / 1,000ppm	chemical products
14818	Copper, [29H.31H-phthalocyaninato(2-)-N29.N30.N31.N32]-, chlorinated	68987-63-3	Intentional addition / 1,000ppm	chemical products
14819	Copper, [29H.31H-phthalocyaninato(2-)-N29.N30.N31.N32]-, [[2-(2-oxo-1-imidazolidinyl)ethyl]amino]sulfonyl sulfo derivatives	68987-64-4	Intentional addition / 1,000ppm	chemical products
14820	Zirconium, dipropylene glycol isobutyl alcohol neodecanoate propionate cobalt complexes	68988-10-3	Contains (regardless of intentional or impurities)	chemical products
14821	Acetic acid, mercapto-, 1,2-ethanediyl ester, reaction products with dibutylxostannane and isocetyl mercaptoacetate	68988-11-4	Contains (regardless of intentional or impurities)	chemical products
14822	Acetic acid, mercapto-, isocetyl ester, reaction products with dichlorodicyclostannane and trichlorodicyclostannane	68988-12-5	Contains (regardless of intentional or impurities)	chemical products
14823	Iron, 2-ethylhexanoate naphthenate complexes, basic	68988-35-2	Intentional addition / 1%	chemical products
14824	Manganese, branched nonanoate 2-ethylhexanoate complexes	68988-36-3	Contains (regardless of intentional or impurities)	chemical products
14825	Manganese, 2-ethylhexanoate naphthenate complexes, basic	68988-37-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
14826	Silicic acid (H4SiO4), tetrapropyl ester, reaction products with dibutylloxostannane	68988-58-9	Contains (regardless of intentional or impurities)	chemical products
14827	Chromium, glycolate sodium complexes	68988-70-5	Intentional addition / 1,000ppm	chemical products
14828	Chromium, acetate 2-hydroxy-3,5-bis(1-methylethyl)benzoate complexes	68988-71-6	Intentional addition / 1,000ppm	chemical products
14829	Quaternary ammonium compounds, benzyl-C10-16-alkyldimethyl, chlorides	68989-00-4	Intentional addition / 1,000ppm	chemical products
14830	Antimony, C.I. Basic Violet 1 tannin complexes	68989-19-5	Contains (regardless of intentional or impurities)	chemical products
14831	Balsams, Canada, zirconium salts	68989-42-4	Contains (regardless of intentional or impurities)	chemical products
14832	Gases, petroleum, crude distillation and catalytic cracking	68989-88-8	Contains (regardless of intentional or impurities)	chemical products
14833	Balsams, copaiba, sulfurized, mixed with turpentine, tin salts	68990-28-3	Contains (regardless of intentional or impurities)	chemical products
14834	Balsams, copaiba, sulfurized, vanadium salts	68990-29-4	Intentional addition / 1%	chemical products
14835	Balsams, Douglas-fir, molybdenum salts	68990-30-7	Intentional addition / 1%	chemical products
14836	Tar, coal, high-temperature, high-solids	68990-61-4	Contains (regardless of intentional or impurities)	chemical products
14837	Cuprate(4-), [3-[[[4-chloro-6-[[2-methylphenyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3,6-disulfo-2-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)]-, tetrasodium	68992-20-1	Intentional addition / 1,000ppm	chemical products
14838	Phosphoric acid, butyl ester, manganese(2+) salt	69011-04-7	Contains (regardless of intentional or impurities)	chemical products
14839	Nickel titanium tungsten oxide (NiTi2W2O47)	69011-05-8	Contains (regardless of intentional or impurities)	chemical products
14840	Antimony chromium titanium oxide (SbCrTi10O23)	69011-08-1	Contains (regardless of intentional or impurities)	chemical products
14841	Cobalt zirconium oxide (CoZrO3)	69011-09-2	Contains (regardless of intentional or impurities)	chemical products
14842	Zirconium, [carbonato(2-)]pentaoxotri-	69011-10-5	Contains (regardless of intentional or impurities)	chemical products
14843	Poly(oxy-1,2-ethanediy), alpha-tridecyl-omega-hydroxy-, branched	69011-36-5	Contains (regardless of intentional or impurities)	chemical products
14844	Tin, dross	69011-52-5	Intentional addition / 1,000ppm	chemical products
14845	Titanium, chlorination residues	69011-53-6	Contains (regardless of intentional or impurities)	chemical products
14846	Silver, bullion	69011-54-7	Contains (regardless of intentional or impurities)	chemical products
14847	Rhenium, manufacturing residues	69011-55-8	Intentional addition / 1%	chemical products
14848	Ammonium molybdenum oxide, sulfide treatment residues	69011-56-9	Intentional addition / 1,000ppm	chemical products
14849	Calcium molybdenum oxide, manufacturing residues - Residues from calcium molybdate manufacture containing various concentrations of iron, molybdenum and silicon.	69011-57-0	Intentional addition / 1%	chemical products
14850	Molybdenum sodium oxide, manufacturing residues	69011-58-1	Intentional addition / 1,000ppm	chemical products
14851	Lignosulfonic acid, reaction products with phenol, sulfonated, chromium salts	69011-62-7	Intentional addition / 1,000ppm	chemical products
14852	Babbitt, dross	69011-64-9	Contains (regardless of intentional or impurities)	chemical products
14853	Bismuth alloy, Bi,Cd, dross	69011-66-1	Contains (regardless of intentional or impurities)	chemical products
14854	Bismuth alloy, Bi,Cd,In, dross	69011-67-2	Contains (regardless of intentional or impurities)	chemical products
14855	Cadmium, dross	69011-69-4	Contains (regardless of intentional or impurities)	chemical products
14856	Cadmium, sponge	69011-70-7	Contains (regardless of intentional or impurities)	chemical products
14857	Zinc ores, concentrates, preleached	69011-86-5	Contains (regardless of intentional or impurities)	chemical products
14858	Cashew, nutshell liquid, polymer with copper oxide and hexamethylenetetramine	69011-95-6	Intentional addition / 1,000ppm	chemical products
14859	Electrolytes, copper-manufacturing, spent, demetalized	69012-16-4	Intentional addition / 1,000ppm	chemical products
14860	Waste solids, copper-casting	69012-17-5	Intentional addition / 1,000ppm	chemical products
14861	Waste solids, copper-refinery	69012-18-6	Intentional addition / 1,000ppm	chemical products
14862	Waste solids, copper-refinery anodes	69012-19-7	Intentional addition / 1,000ppm	chemical products
14863	Waste solids, copper electrolyte purification cathodes	69012-20-0	Contains (regardless of intentional or impurities)	chemical products
14864	Wastewater, cadmium sulfate electrolytic, acid	69012-21-1	Contains (regardless of intentional or impurities)	chemical products
14865	Residues, copper-smelting fume-wash wastewater, copper zinc carbonate	69012-22-2	Contains (regardless of intentional or impurities)	chemical products
14866	Wastewater, molybdenum-rhenium ore-roaster scrubber	69012-23-3	Intentional addition / 1%	chemical products
14867	Wastewater, zinc sulfate electrolytic, acid	69012-24-4	Contains (regardless of intentional or impurities)	chemical products
14868	Slags, aluminum-vanadium	69012-25-5	Intentional addition / 1%	chemical products
14869	Slags, brass-manufacturing	69012-26-6	Contains (regardless of intentional or impurities)	chemical products
14870	Slags, ferromanganese-manufacturing	69012-28-8	Contains (regardless of intentional or impurities)	chemical products
14871	Slags, silicomanganese-manufacturing	69012-33-5	Contains (regardless of intentional or impurities)	chemical products
14872	Slags, steelmaking, vanadium	69012-34-6	Intentional addition / 1%	chemical products
14873	Slimes and Sludges, cobalt-terephthalate	69012-37-9	Intentional addition / 1%	chemical products
14874	Slimes and Sludges, copper, Peabody	69012-38-0	Intentional addition / 1,000ppm	chemical products
14875	Slimes and Sludges, molybdenum-cleaning caustic	69012-40-4	Intentional addition / 1%	chemical products
14876	Slimes and Sludges, molybdenum oxide roasting elec.-precipitator	69012-41-5	Contains (regardless of intentional or impurities)	chemical products
14877	Slimes and Sludges, zinc sulfate electrolytic	69012-43-7	Contains (regardless of intentional or impurities)	chemical products
14878	Slimes and Sludges, zinc, Peabody	69012-44-8	Contains (regardless of intentional or impurities)	chemical products
14879	Scale, coating, copper	69012-45-9	Intentional addition / 1,000ppm	chemical products
14880	Residues, zinc Leach, secondary	69012-47-1	Intentional addition / 1,000ppm	chemical products
14881	Manganese ores, reduced	69012-49-3	Contains (regardless of intentional or impurities)	chemical products
14882	Matte, nickel	69012-50-6	Contains (regardless of intentional or impurities)	chemical products
14883	Copper cake, zinc-refining	69012-51-7	Contains (regardless of intentional or impurities)	chemical products
14884	Copper ores, sulfide-treated, silver-copper residues	69012-52-8	Intentional addition / 1,000ppm	chemical products
14885	Electrolytes, copper-manufacturing, spent	69012-54-0	Intentional addition / 1,000ppm	chemical products
14886	Ferrous alloys, spiegel	69012-55-1	Contains (regardless of intentional or impurities)	chemical products
14887	Flue dust, brass-manufacturing - Metal particles and metallic oxides from brass melting and casting operations resulting from hammer mill operation.	69012-56-2	Contains (regardless of intentional or impurities)	chemical products
14888	Flue dust, cadmium-refining	69012-57-3	Contains (regardless of intentional or impurities)	chemical products
14889	Flue dust, copper alloy-manufacturing, zinc oxide-containing	69012-58-4	Intentional addition / 1,000ppm	chemical products
14890	Flue dust, molybdenum ore-roasting	69012-61-9	Intentional addition / 1%	chemical products
14891	Flue dust, zinc-refining	69012-63-1	Contains (regardless of intentional or impurities)	chemical products
14892	Fumes, zinc	69012-65-3	Contains (regardless of intentional or impurities)	chemical products
14893	Leach residues, copper cake	69012-67-5	Contains (regardless of intentional or impurities)	chemical products
14894	Leach residues, molybdenum ore, iron-containing	69012-68-6	Intentional addition / 1%	chemical products
14895	Leach residues, zinc ore-calcine	69012-70-0	Contains (regardless of intentional or impurities)	chemical products
14896	Leach residues, zinc ore-calcine, cobalt repulp	69012-71-1	Contains (regardless of intentional or impurities)	chemical products
14897	Leach residues, zinc ore-calcine, zinc cobalt	69012-72-2	Contains (regardless of intentional or impurities)	chemical products
14898	Leach solutions, copper, ammonium sulfate	69012-74-4	Intentional addition / 1,000ppm	chemical products
14899	Leach solutions, copper oxide ore, iron-treated	69012-75-5	Intentional addition / 1,000ppm	chemical products
14900	Leach solutions, copper, spent	69012-76-6	Intentional addition / 1,000ppm	chemical products
14901	Leach solutions, molybdenum, spent sulfate	69012-77-7	Intentional addition / 1,000ppm	chemical products
14902	Calcines, copper smelting-fly-ash	69012-78-8	Contains (regardless of intentional or impurities)	chemical products
14903	Fats and Glyceric oils, marine, hydrogenated, reaction products with glycerol and tallow, barium sodium salts	69013-10-1	Contains (regardless of intentional or impurities)	chemical products
14904	Rosin, polymer with boron trifluoride-ethyl ether complex and sodium hydroxymethanesulfonate	69013-15-6	Contains (regardless of intentional or impurities)	chemical products
14905	Alcohols, C8-22, ethoxylated	69013-19-0	Intentional addition / 1%	chemical products
14906	Guanidine, [4-(chloromethyl)-2-thiazolyl]-, monohydrochloride	69014-12-6	Intentional addition / 1%	chemical products
14907	Limosulfonic acid, molybdenum salt	69029-14-7	Intentional addition / 1%	chemical products
14908	2,6-Octadien-1-ol, 3,7-dimethyl-, (E)-, ester with boric acid (H3BO3)	69029-40-9	Intentional addition / 1%	chemical products
14909	Dore	69029-47-6	Contains (regardless of intentional or impurities)	chemical products
14910	Indium, cake	69029-48-7	Contains (regardless of intentional or impurities)	chemical products
14911	Indium, sulfide cake	69029-49-8	Contains (regardless of intentional or impurities)	chemical products
14912	Selenium, waste acid precipitated	69029-55-6	Contains (regardless of intentional or impurities)	chemical products
14913	Silica, indium cake	69029-56-7	Contains (regardless of intentional or impurities)	chemical products
14914	Silver, crusts	69029-57-8	Contains (regardless of intentional or impurities)	chemical products
14915	Zinc, desilverizing skims	69029-60-3	Contains (regardless of intentional or impurities)	chemical products
14916	Calcines, acid cake	69029-62-5	Contains (regardless of intentional or impurities)	chemical products
14917	Calcines, cadmium residue	69029-63-6	Contains (regardless of intentional or impurities)	chemical products
14918	Charcoal, activated, indium containing	69029-64-7	Contains (regardless of intentional or impurities)	chemical products
14919	Flue dust, acid cake calcine	69029-65-8	Contains (regardless of intentional or impurities)	chemical products
14920	Flue dust, acid cake calcine	69029-66-9	Contains (regardless of intentional or impurities)	chemical products
14921	Gold, dross	69029-68-1	Contains (regardless of intentional or impurities)	chemical products
14922	Indium, purification cake	69029-69-2	Contains (regardless of intentional or impurities)	chemical products
14923	Leach residues, cadmium-refining	69029-70-5	Contains (regardless of intentional or impurities)	chemical products
14924	Leach residues, tellurium	69029-73-8	Contains (regardless of intentional or impurities)	chemical products
14925	Residues, cadmium-refining	69029-77-2	Contains (regardless of intentional or impurities)	chemical products
14926	Residues, thallium	69029-81-8	Contains (regardless of intentional or impurities)	chemical products
14927	Residues, zinc smelting	69029-83-0	Contains (regardless of intentional or impurities)	chemical products
14928	Slags, tellurium	69029-86-3	Contains (regardless of intentional or impurities)	chemical products
14929	Slags, type metal smelting	69029-87-4	Contains (regardless of intentional or impurities)	chemical products
14930	Slimes and Sludges, acid cake calcine	69029-88-5	Contains (regardless of intentional or impurities)	chemical products
14931	Slimes and Sludges, cadmium electrolytic	69029-89-6	Contains (regardless of intentional or impurities)	chemical products
14932	Slimes and Sludges, cadmium-refining, oxidized	69029-90-9	Contains (regardless of intentional or impurities)	chemical products
14933	Slimes and Sludges, cadmium sump tank	69029-91-0	Contains (regardless of intentional or impurities)	chemical products
14934	Slimes and Sludges, indium carbonate	69029-92-1	Contains (regardless of intentional or impurities)	chemical products
14935	Slimes and Sludges, smelting	69029-94-3	Intentional addition / 1,000ppm	chemical products
14936	Slimes and Sludges, thallium	69029-95-4	Contains (regardless of intentional or impurities)	chemical products
14937	Slimes and Sludges, thallium carbonate	69029-96-5	Contains (regardless of intentional or impurities)	chemical products
14938	Speiss, copper	69029-97-6	Contains (regardless of intentional or impurities)	chemical products
14939	Wastes, flash furnace	69029-98-7	Intentional addition / 1,000ppm	chemical products
14940	Cuprate(4-), [mu-[[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-2-(7-naphthalenedisulfonato)](8-)]di-, 1-amino-2-propanol sodium salts	69030-02-0	Intentional addition / 1,000ppm	chemical products
14941	Stannane, dibutylbis(butylmercaptomethoxy-1-oxopropoxy)-	69039-26-5	Contains (regardless of intentional or impurities)	chemical products
14942	Pyridine, 2-chloro-5-(trichloromethyl)-	69045-78-9	Contains (regardless of intentional or impurities)	chemical products
14943	Methacrylic acid, tin salt	69064-21-7	Contains (regardless of intentional or impurities)	chemical products
14944	Bis(methacrylate-O)chromium	69068-10-6	Intentional addition / 1,000ppm	chemical products
14945	Ethanaminium, N-[4-bis[4-(diethylamino)phenyl]methylene]-2,5-cyclohexadien-1-ylidene-N-ethyl-, hydroxide tetraacosa-mu-oxododecaoxo[.mu.12-[phosphato(3-)-O.O.O.O':O':O':O':O':O':O':O':O']dodecamolybdate(4-)(4:1:1), monohydrate	69070-63-9	Contains (regardless of intentional or impurities)	chemical products
14946	Ethanaminium, N-[4-[4-(diethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene-N-ethyl-, hydroxide tetraacosa-mu-oxododecaoxo[.mu.12-[phosphato(3-)-O.O.O.O':O':O':O':O':O':O':O':O']dodecamolybdate(4-)(4:1:1), monohydrate	69070-64-0	Contains (regardless of intentional or impurities)	chemical products
14947	Molybdate(3-), tetraacosa-mu-oxododecaoxo[.mu.12-[phosphato(3-)-O.O.O.O':O':O':O':O':O':O':O':O']dodeca-, trihydrogen, compound with 4-[(4-aminophenyl)(4-imino-2,5-cyclohexadien-1-ylidene)methyl]-2-methylbenzenamine	69089-44-7	Contains (regardless of intentional or impurities)	chemical products
14948	Cobalt dichloride hydrate	69098-14-2	Intentional addition / 1%	chemical products





#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15052	1-Chloro-1,2,2-trifluoropropane	70192-76-6	Intentional addition	chemical products
15053	Propane, 1,1-dibromo-2,2-difluoro-	70192-79-9	Intentional addition / 1,000ppm	chemical products
15054	Propane, 1,1,1-tribromo-2,2-difluoro-	70192-80-2	Contains (regardless of intentional or impurities)	chemical products
15055	Propane, 1,1-dibromo-1,2,2-trifluoro-	70192-83-5	Intentional addition / 1,000ppm	chemical products
15056	Propane, 1-bromo-1,1,2,2-tetrafluoro-	70192-84-6	Intentional addition / 1,000ppm	chemical products
15057	Propane, 1-bromo-1,2,2-trifluoro-	70192-85-7	Intentional addition / 1,000ppm	chemical products
15058	1,2,2-Trichloro-3-fluoropropane	70192-89-1	Intentional addition	chemical products
15059	Chromate(1-), [N-[3-[[8-(acetylamino)-2-hydroxy-1-naphthalenyl]azo]-2-hydroxy-5-nitrophenyl]acetamidato(2-)]-[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]-N-methylbenzenesulfonamidato(2-)]-, sodium	70198-31-1	Contains (regardless of intentional or impurities)	chemical products
15060	Cadmium chloride, tetrahydrate	70206-08-5	Contains (regardless of intentional or impurities)	chemical products
15061	Chromate(1-), bis[2,4-dihydro-4-[[2-hydroxyphenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	70209-86-8	Contains (regardless of intentional or impurities)	chemical products
15062	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, disodium	70209-87-9	Contains (regardless of intentional or impurities)	chemical products
15063	Benzenesulfonic acid, 3-(benzoylamino)-4-hydroxy-5-[[1-[[4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1,3-dioxobutyl]amino]-3,3-dimethoxy[1,1'-biphenyl]-4-yl]amino]carbonyl]-2-oxopropyl]-, monosodium salt	70210-32-1	Intentional addition	chemical products
15064	Chromate(1-), [2-(3-chlorophenyl)-2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]-[methyl 7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl]carbamato(2-)]-, sodium	70236-40-7	Contains (regardless of intentional or impurities)	chemical products
15065	Cobaltate(1-), [2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[N-(7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, sodium	70236-41-8	Intentional addition / 1,000ppm	chemical products
15066	Chromate(1-), bis[2,4-dihydro-4-[[2-hydroxy-4-(methylsulfonyl)phenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	70236-42-9	Contains (regardless of intentional or impurities)	chemical products
15067	Cobaltate(1-), bis[5-[(5-chloro-2-hydroxyphenyl)azo]-6-hydroxy-N-(2-hydroxyethyl)-N-methyl-2-naphthalenesulfonamidato(2-)]-, sodium	70236-43-0	Intentional addition / 1,000ppm	chemical products
15068	Cobaltate(1-), bis[2-(3-chlorophenyl)-2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]-, sodium	70236-44-1	Intentional addition / 1,000ppm	chemical products
15069	Chromium, [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, disodium	70236-49-6	Intentional addition / 1,000ppm	chemical products
15070	Cuprate(3-), [4-amino-5-hydroxy-6-[[2-hydroxy-4-sulfo-6-[[2,5,6-trichloro-4-pyrimidinyl]amino]-1-naphthalenyl]azo]-1,3-naphthalenedisulfonato(5-)]-, trisodium	70236-50-9	Intentional addition / 1,000ppm	chemical products
15071	Cuprate(3-), [mu.-[2-[[6-[[3-chloro-2-hydroxy-5-sulfonyl]azo]-5-hydroxy-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(7-)]di-, trisodium	70236-52-1	Intentional addition / 1,000ppm	chemical products
15072	Cuprate(3-), [2-[[4-[[6-[[4-amino-6-chloro-1,3,5-triazin-2-yl]methylamino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-5-hydroxy-2-methylphenyl]azo]-1,4-benzenedisulfonato(5-)]-, trisodium	70236-53-2	Intentional addition / 1,000ppm	chemical products
15073	Cuprate(3-), [4-amino-5-hydroxy-6-[[2-hydroxy-3-sulfo-5-[[2,5,6-trichloro-4-pyrimidinyl]amino]phenyl]azo]-1,3-naphthalenedisulfonato(5-)]-, trisodium	70236-54-3	Intentional addition / 1,000ppm	chemical products
15074	Chromate(2-), [1-[[2-hydroxy-3,5-dinitrophenyl]azo]-2-naphthalenolato(2-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, disodium	70236-55-4	Contains (regardless of intentional or impurities)	chemical products
15075	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-[N-(7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, disodium	70236-56-5	Contains (regardless of intentional or impurities)	chemical products
15076	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, disodium	70236-57-6	Contains (regardless of intentional or impurities)	chemical products
15077	Cobaltate(1-), bis[6-amino-5-[[2-hydroxy-4-nitrophenyl]azo]-N-methyl-2-naphthalenesulfonamidato(2-)]-, sodium	70236-59-8	Intentional addition / 1,000ppm	chemical products
15078	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, disodium	70236-60-1	Contains (regardless of intentional or impurities)	chemical products
15079	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, disodium	70236-61-2	Contains (regardless of intentional or impurities)	chemical products
15080	Chromate(2-), [3-(4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-[1-[[2-hydroxy-5-(phenylazo)phenyl]azo]-2-naphthalenolato(2-)]-, disodium	70236-62-3	Contains (regardless of intentional or impurities)	chemical products
15081	2-[[5-Cyanotetrazolato] pentamine cobalt(III) perchlorate	70247-32-4	Intentional addition / 1,000ppm	chemical products
15082	Cuprate(4-), [mu.-[[2,2'-(carbonylbis[imino(2-sulfo-4,1-phenylene)-2,1-ethenediyl(3-sulfo-4,1-phenylene)](4,5-dihydro-3-methyl-5-oxo-1H-pyrazole-1,4-diylo)azo]bis]benzoato(8-)]di-, tetrasodium	70247-71-1	Intentional addition / 1,000ppm	chemical products
15083	Cuprate(3-), [4-hydroxy-5-[[1-hydroxy-3-sulfo-6-[[4-[[2,5,6-trichloro-4-pyrimidinyl]amino]phenyl]amino]-2-naphthalenyl]azo]-1,3-benzenedisulfonato(5-)]-, trisodium	70247-72-2	Intentional addition / 1,000ppm	chemical products
15084	Cobaltate(1-), bis[N-(2-chlorophenyl)-2-[[2-hydroxy-5-[(methylamino)sulfonyl]phenyl]azo]-3-oxobutanamidato(2-)]-, sodium	70247-73-3	Intentional addition / 1,000ppm	chemical products
15085	Cobaltate(1-), bis[N-(2-chlorophenyl)-2-[[2-hydroxy-5-[(methylamino)sulfonyl]phenyl]azo]-3-oxobutanamidato(2-)]-, sodium	70247-74-4	Intentional addition / 1,000ppm	chemical products
15086	Chromate(1-), [5,8-dichloro-2-[[5-chloro-2-hydroxyphenyl]azo]-1-naphthalenolato(2-)]-[4-hydroxy-3-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthalenesulfonato(3-)]-, disodium	70247-75-5	Contains (regardless of intentional or impurities)	chemical products
15087	Cobaltate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-(2-methoxyethyl)benzenesulfonamidato(2-)]-, sodium	70247-76-6	Intentional addition / 1,000ppm	chemical products
15088	Chromate(1-), bis[5-(aminosulfonyl)-2-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-, sodium	70247-77-7	Contains (regardless of intentional or impurities)	chemical products
15089	Antimony oxide (Sb2O3), reaction products with silica	70247-82-4	Contains (regardless of intentional or impurities)	chemical products
15090	Cuprate(4-), [mu.-[[4,4'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[3-hydroxy-2,7-naphthalenedisulfonato(6-)]di-, diethanolamine sodium salts	70247-84-6	Intentional addition / 1,000ppm	chemical products
15091	Cuprate(4-), [mu.-[[4,4'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[3-hydroxy-2,7-naphthalenedisulfonato(6-)]di-, sodium	70247-85-7	Intentional addition / 1,000ppm	chemical products
15092	C.I. Pigment Brown 37	70248-09-8	Contains (regardless of intentional or impurities)	chemical products
15093	Strychnidin-10-one, mono[(S)-1,3-dihydro-alpha-[[2-methoxy-4-nitrophenyl]methyl]-1,3-dioxo-2H-isindole-2-acetate]	70266-85-2	Contains (regardless of intentional or impurities)	chemical products
15094	Strychnidin-10-one, mono[(R)-1,3-dihydro-alpha-[[2-methoxy-4-nitrophenyl]methyl]-1,3-dioxo-2H-isindole-2-acetate]	70266-86-3	Contains (regardless of intentional or impurities)	chemical products
15095	Pentanoic acid, manganese(2+) salt	70268-41-6	Contains (regardless of intentional or impurities)	chemical products
15096	Chromate(1-), [2-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-[methyl 7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl]carbamato(2-)]-, sodium	70281-39-9	Contains (regardless of intentional or impurities)	chemical products
15097	Cobaltate(1-), bis[3-[[4,5-dihydro-3-methyl-1-(4-methylphenyl)-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamidato(2-)]-, sodium	70281-40-2	Intentional addition / 1,000ppm	chemical products
15098	Chromate(1-), [2-(3-chlorophenyl)-2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]-[N-(7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, sodium	70281-41-3	Contains (regardless of intentional or impurities)	chemical products
15099	Chromate(1-), [N-[3-[[8-(acetylamino)-2-hydroxy-1-naphthalenyl]azo]-2-hydroxy-5-nitrophenyl]acetamidato(2-)]-[N-(7-hydroxy-8-[[2-hydroxy-5-[(methylamino)sulfonyl]phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, sodium	70288-95-8	Contains (regardless of intentional or impurities)	chemical products
15100	Stannane, (ethylthio)triocetyl-	70303-46-7	Contains (regardless of intentional or impurities)	chemical products
15101	Stannane, (butylthio)triocetyl-	70303-47-8	Contains (regardless of intentional or impurities)	chemical products
15102	Cuprate(4-), [5-[[2,5-dimethyl-4-[[4-sulfonyl]azo]phenyl]azoxy]-2-[[4-[[3-hydroxy-4-[[2-hydroxy-5-sulfonyl]azo]phenyl]azoxy]-2-sulfonyl]ethenyl]benzenesulfonato(6-)]-, tetrasodium	70304-36-8	Intentional addition / 1,000ppm	chemical products
15103	Cuprate(3-), [5-[[4-[[3-chloro-2-hydroxy-5-sulfonyl]azo]-3-hydroxyphenyl]azoxy]-2-[[4-nitro-2-sulfonyl]ethenyl]benzenesulfonato(5-)]-, trisodium	70304-38-0	Intentional addition / 1,000ppm	chemical products
15104	Cuprate(4-), [2-[[2-[[4-[[5-hydroxy-4-[[2-hydroxy-5-sulfonyl]azo]-2-methoxyphenyl]azoxy]-2-sulfonyl]ethenyl]-5-[[4-[[4-sulfonyl]azo]phenyl]azoxy]benzenesulfonato(6-)]-, tetrasodium	70304-39-1	Intentional addition / 1,000ppm	chemical products
15105	Cuprate(4-), [mu.-[[2,2'-(1,2-ethenediyl)bis[[5-[[5-hydroxy-4-[[2-hydroxy-5-sulfonyl]azo]-2-methoxyphenyl]azoxy]benzenesulfonato(8-)]di-, tetrasodium	70304-40-4	Intentional addition / 1,000ppm	chemical products
15106	Tar bases, coal quinoline derivatives fraction	70321-67-4	Contains (regardless of intentional or impurities)	chemical products
15107	Cresote oil, high-boiling distillate	70321-79-8	Contains (regardless of intentional or impurities)	chemical products
15108	Cresote oil, low-boiling distillate	70321-80-1	Contains (regardless of intentional or impurities)	chemical products
15109	Phenol, 2-(2H-benzotriazol-2-yl)-4,6-bis(1-methyl-1-phenylethyl)-	70321-86-7	Intentional addition / 100ppm	chemical products
15110	Silver arsenide (Ag2As)	70333-07-2	Contains (regardless of intentional or impurities)	chemical products
15111	Hexane, 2-bromo-2-methyl-	70351-82-5	Intentional addition / 1,000ppm	chemical products
15112	1,4-Bromo-2-methyloctane	70351-83-6	Intentional addition / 1,000ppm	chemical products
15113	Lithium ferrosilicon	70399-13-2	Intentional addition / 1%	chemical products
15114	1-Isopropylsulfanyl-2-nitrobenzene	70415-85-9	Contains (regardless of intentional or impurities)	chemical products
15115	Minoxantrone hydrochloride	70416-82-3	Contains (regardless of intentional or impurities)	chemical products
15116	Copper(2+), triaminetrisaqua	70493-34-4	Intentional addition / 1,000ppm	chemical products
15117	Antimony compound with zirconium (1:1)	70495-28-2	Contains (regardless of intentional or impurities)	chemical products
15118	Thorium telluride (ThTe2)	70495-35-1	Contains (regardless of intentional or impurities)	chemical products
15119	Flue dust, ferromanganese-manufacturing	70514-87-9	Contains (regardless of intentional or impurities)	chemical products
15120	Slags, antimony-smelting	70514-71-5	Contains (regardless of intentional or impurities)	chemical products
15121	Isooctanoic acid, iron salt	70519-09-4	Intentional addition / 1%	chemical products
15122	Cuprate(3-), [2-[[4-[[6-[[4-amino-6-fluoro-1,3,5-triazin-2-yl]methylamino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-5-hydroxy-2-methylphenyl]azo]-1,4-benzenedisulfonato(5-)]-, trisodium	70529-02-1	Intentional addition / 1,000ppm	chemical products
15123	Cobaltate(2-), bis[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, disodium	70529-03-2	Intentional addition / 1,000ppm	chemical products
15124	Chromate(1-), bis[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, sodium	70529-04-3	Contains (regardless of intentional or impurities)	chemical products
15125	Copper(2+)(R)-N-(2,4-dihydroxy-3,3-dimethyl-1-oxobutyl)-beta-alaninate	70581-71-4	Intentional addition / 1,000ppm	chemical products
15126	(Diphenyl)methyleneaminoacetone	70591-20-7	Intentional addition	chemical products
15127	Distillates, petroleum, intermediate vacuum	70592-76-6	Contains (regardless of intentional or impurities)	chemical products
15128	Distillates, petroleum, light vacuum	70592-77-7	Contains (regardless of intentional or impurities)	chemical products
15129	Distillates, petroleum, vacuum	70592-78-8	Contains (regardless of intentional or impurities)	chemical products
15130	Amines, C10-16-alkyldimethyl, N-oxides	70592-80-2	Intentional addition / 1%	chemical products
15131	Spinels, aluminum magnesium zirconium	70592-82-4	Contains (regardless of intentional or impurities)	chemical products
15132	Di-n-octyl tin oxide polymer	70605-35-5	Intentional addition / 1,000ppm	chemical products
15133	2,7-Naphthalenedisulfonic acid, 4-amino-5-hydroxy-3-[[4-[[4-hydroxyphenyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-6-[[4-sulfonyl]azo]-, trisodium salt	70632-07-4	Intentional addition	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15134	2,7-Naphthalenedisulfonic acid, 4-amino-3-[[4-(2-amino-4-hydroxyphenyl)azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-5-hydroxy-6-[[4-sulfophenyl]azo]-, trisodium salt	70632-08-5	Intentional addition	chemical products
15135	1,2,3,4,7,8-Hexachlorodibenzofuran	70648-26-9	Contains (regardless of intentional or impurities)	chemical products
15136	1-Propanol, 2-methoxy-, acetate	70657-70-4	Contains (regardless of intentional or impurities)	chemical products
15137	Pentane, 1,3,3,5-tetrabromo-	70660-83-2	Intentional addition / 1,000ppm	chemical products
15138	Benzoselenazolium, 5-methoxy-2-[[5-methyl-3-(3-sulfopropyl)-2(3H)-benzoselenazolylidene]methyl]-3-(3-sulfopropyl)-, inner salt, sodium salt	70679-43-5	Contains (regardless of intentional or impurities)	chemical products
15139	Phenol, 4,4'-(1-methylethylidene)bis[2,6-dibromo-, polymer with 2,2'-[[1-methylethylidene]bis[2,6-dibromo-4,1-phenylene]oxy)methylene]bis[oxirane]	70682-74-5	Intentional addition / 900ppm	chemical products
15140	Nickel zirconium oxide (NiZrO3)	70692-93-2	Contains (regardless of intentional or impurities)	chemical products
15141	Manganese zirconium oxide (MnZrO3)	70692-94-3	Contains (regardless of intentional or impurities)	chemical products
15142	Aluminum zirconium oxide (AlZr2O9)	70692-95-4	Contains (regardless of intentional or impurities)	chemical products
15143	Carboxylic acids, C6-19-iso-, cobalt potassium salts	70693-07-1	Intentional addition / 1%	chemical products
15144	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[3-[[[3,6-dichloro-4-pyridazinyl]carbonyl]amino]-4-methyl-5-sulfonylphenyl]sulfonyl sulfo derivatives	70693-19-5	Intentional addition / 1,000ppm	chemical products
15145	Benzeneamine, N,N-diethyl-3-methyl-4-[[5-nitro-2-thiazolyl]azo]-	70693-64-0	Contains (regardless of intentional or impurities)	chemical products
15146	Chromate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-methylbenzenesulfonamidato(2-)-], hydrogen	70703-37-6	Contains (regardless of intentional or impurities)	chemical products
15147	2-(Pentadecyloxy)ethanol	70709-94-3	Intentional addition / 1%	chemical products
15148	Samarium selenide (Sm2Se)	70714-63-5	Contains (regardless of intentional or impurities)	chemical products
15149	Copper zirconium oxide (CuZrO3)	70714-64-6	Contains (regardless of intentional or impurities)	chemical products
15150	1,3,6-Naphthalenetrisulfonic acid, 7-amino-, diammonium salt	70714-69-1	Contains (regardless of intentional or impurities)	chemical products
15151	2,7-Naphthalenedisulfonic acid, 3-hydroxy-4-[[1-sulfo-2-naphthalenyl]azo]-, barium salt (2:3)	70729-66-7	Contains (regardless of intentional or impurities)	chemical products
15152	Ethanol, 2,2',2'-[[butylstannylydene]tris(thio)tris-	70729-71-4	Contains (regardless of intentional or impurities)	chemical products
15153	Nickelate(4-), [2,2'-[[4-sulfonylphenyl]amino]sulfonyl]-29H,31H-phthalocyanine-1,8,15-trisulfonato(6-)-N29,N30,N31,N32]-, tetrahydrogen, (SP-4-2)-	70729-79-2	Contains (regardless of intentional or impurities)	chemical products
15154	Silicic acid (H4SiO4), tetraethyl ester, reaction products with dibutylbis[1-oxododecyl]oxystannane	70750-24-2	Contains (regardless of intentional or impurities)	chemical products
15155	1-Octadecanaminium, N,N-dimethyl-N-octadecyl-, (Sp-4-2)-[29H,31H-phthalocyanine-2-sulfonato(3-)-N29,N30,N31,N32]cuprate(1-)	70750-63-9	Intentional addition / 1,000ppm	chemical products
15156	Sulfonic acids, C10-18-alkane, phenyl esters	70775-94-9	Intentional addition / 1,000ppm	chemical products
15157	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[2-[[2-aminoethyl]amino]ethyl]amino]sulfonyl sulfo derivatives, glycolates methanesulfonates	70776-00-0	Intentional addition / 1,000ppm	chemical products
15158	Cuprate(3-), [5-amino-3-[[3-chloro-2-hydroxy-5-sulfonylphenyl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(5-)-], trisodium	70776-13-5	Intentional addition / 1,000ppm	chemical products
15159	Chromate(5-), bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)-], tetrasodium hydrogen	70776-54-4	Contains (regardless of intentional or impurities)	chemical products
15160	Cobaltate(5-), bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)-], tetrasodium hydrogen	70776-55-5	Intentional addition / 1,000ppm	chemical products
15161	Chromate(1-), bis[3-[[4-[[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)-], hydrogen	70776-97-5	Contains (regardless of intentional or impurities)	chemical products
15162	Nickel, 2-(ethylhexanoato-O)(trifluoroacetato-O)-	70776-98-6	Contains (regardless of intentional or impurities)	chemical products
15163	Chromate(3-), bis[2-[[6-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(3-)-], disodium hydrogen	70788-62-4	Contains (regardless of intentional or impurities)	chemical products
15164	Chromate(3-), bis[2-[[6-[[4,6-dichloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(3-)-], disodium hydrogen	70788-63-5	Contains (regardless of intentional or impurities)	chemical products
15165	Zinc, tris(neodecanoato-O)(mu,3-torhoborato(3-)-O,O',O')tri-	70801-03-5	Intentional addition / 1%	chemical products
15166	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)-], sodium hydrogen	70815-17-7	Contains (regardless of intentional or impurities)	chemical products
15167	Cobaltate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[1-(2-hydroxyphenyl)azo]-2-naphthalenolato(2-)-], hydrogen, compound with 1-tridecanamine (1:1)	70815-19-9	Intentional addition / 100ppm	chemical products
15168	Bis(5-oxo-L-prolinato-N1,O2)nickel	70824-02-1	Contains (regardless of intentional or impurities)	chemical products
15169	Chromate(1-), [4-hydroxy-5-[[2-hydroxy-1-naphthalenyl]azo]-1,3-benzenedisulfonato(4-)-], sodium	70833-33-9	Contains (regardless of intentional or impurities)	chemical products
15170	Cobaltate(8-), bis[4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-7-(3-phosphonophenyl)amino]-2-naphthalenesulfonato(5-)-], tetraammonium tetrahydrogen	70833-34-0	Intentional addition / 1,000ppm	chemical products
15171	Chromate(4-), [2-[[4-[[2,4-dihydroxy-5-[[2-hydroxy-3,5-dinitrophenyl]azo]-3-[[4-nitrophenyl]azo]phenyl]azo]phenyl]amino]-5-nitrobenzenesulfonato(3-)-]]-[2,6-dihydroxy-3-[[2-hydroxy-3,5-dinitrophenyl]azo]-5-[[4-[[4-nitro-2-sulfonylphenyl]amino]phenyl]azo]phenyl]azo]-5-nitrobenzenesulfonato(4-)-], trisodiumhydrogen	70833-36-2	Contains (regardless of intentional or impurities)	chemical products
15172	Nickel, bis(3-amino-4,5,6,7-tetrachloro-1H-isoindol-1-one oximate-N2,O1)-	70833-37-3	Contains (regardless of intentional or impurities)	chemical products
15173	Cobaltate(4-), bis[2-[[[3-[[1-[[2-chlorophenyl]amino]carbonyl]-2-oxopropyl]azo]-4-hydroxyphenyl]sulfonyl]amino]benzoato(3-)-], tetrasodium	70851-34-2	Intentional addition / 1,000ppm	chemical products
15174	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, hydrogen bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]chromate(3-)(1:2), compound with 3-[[2-butylhexyl]oxy]-1-propanamine (1:1)	70851-41-1	Contains (regardless of intentional or impurities)	chemical products
15175	1,3-didecyl-2-methyl-1H-imidazolium chloride	70862-65-6	Intentional addition / 1,000ppm	chemical products
15176	6-Methoxy-2,5-dimethylbenzoselenazole	70867-60-6	Contains (regardless of intentional or impurities)	chemical products
15177	Copper, 4-bis[4-(dimethylamino)phenyl]methyl-N-ethyl-1-naphthalenamine complexes, ferrocyanides	70879-63-9	Contains (regardless of intentional or impurities)	chemical products
15178	Chromate(2-), [3-hydroxy-4-[[1-hydroxy-2-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]N-[4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]-2-propanamidato(2-)-], sodium hydrogen	70880-00-1	Contains (regardless of intentional or impurities)	chemical products
15179	Chromate(2-), [N-7-[[5-chloro-2-hydroxyphenyl]azo]-8-hydroxy-6-sulfo-2-naphthalenyl]-2-propanamidato(2-)]-[1-(2-hydroxyphenyl)azo]-2-naphthalenolato(2-)-], sodium hydrogen	70880-01-2	Contains (regardless of intentional or impurities)	chemical products
15180	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-6-[[1-oxo-2-propenyl]amino]-2-naphthalenesulfonato(3-)-], sodium hydrogen	70880-02-3	Contains (regardless of intentional or impurities)	chemical products
15181	Cuprate(4-), [3-[[3-chloro-2-hydroxy-5-sulfonylphenyl]azo]-5-[[4-chloro-6-[[3-sulfonylphenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-2,7-naphthalenedisulfonato(6-)-], tetrasodium	70880-03-4	Intentional addition / 1,000ppm	chemical products
15182	Copper, 2-[[6-amino-1-hydroxy-2-naphthalenyl]azo]benzoate 3-[[4-amino-2-methoxyphenyl]azo]-6-(carboxyamino)-4-hydroxy-2-naphthalenesulfonate 4-[[4-amino]phenyl]azo]benzenesulfonate 2,2'-(1,2-ethenediyl)bis[5-nitrobenzenesulfonato] sodium complexes	70892-30-7	Intentional addition / 1,000ppm	chemical products
15183	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[2-chloroethyl]amino]sulfonyl sulfo derivatives, sodium salts	70892-31-8	Intentional addition / 1,000ppm	chemical products
15184	Poly(1,1,2,2-tetrafluoro-1,2-ethanediyl), alpha-[[2-[[2-carboxyethyl]thio]ethyl]-omega-fluoro-, reaction products with chromium chloride hydroxide (CrCl2(OH)) (1:2)	70892-42-1	Contains (regardless of intentional or impurities)	chemical products
15185	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-phosphonophenyl]amino]sulfonyl sulfo derivatives, ammonium salts	70892-50-1	Intentional addition / 1,000ppm	chemical products
15186	Chromate(7-), bis[2-[[6-[[4-chloro-6-[[4-[[2-(4-nitro-2-sulfonylphenyl)ethenyl]-3-sulfonyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(5-)-], hexasodium hydrogen	70892-94-3	Contains (regardless of intentional or impurities)	chemical products
15187	Ethanol, 2-ethoxy-, acetate, polymer with dibutylbis[[1-oxododecyl]oxy]stannane, 1,3-diisocyanatomethylbenzene and 2,2'-oxybis[ethanol]	70892-97-6	Contains (regardless of intentional or impurities)	chemical products
15188	1,2,3-Propanetriol, polymer with dibutylbis[[1-oxododecyl]oxy]stannane, 1,3-diisocyanatomethylbenzene, 2-ethoxyethyl acetate and 2,2'-oxybis[ethanol]	70892-98-7	Contains (regardless of intentional or impurities)	chemical products
15189	Chromate(4-), [2-[[[4,6-dichloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-5-sulfonylbenzoato(4-)]-[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)-], trisodium hydrogen	70900-26-4	Contains (regardless of intentional or impurities)	chemical products
15190	Vanadium, oxo[29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (dibutylamino)sulfonyl derivatives	70914-46-4	Intentional addition / 1%	chemical products
15191	Cobaltate(5-), bis[5-amino-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)-], pentahydrogen	70936-53-7	Intentional addition / 1%	chemical products
15192	Boron, [N-3-(dimethylamino)propyl]-2-propanamide-NN(tri)hydro-, (T-4)-, polymer with diethylenbenzene and 1,1'-[oxybis(2,1-ethanedioxy)]bis[ethene]	70942-05-1	Intentional addition / 1%	chemical products
15193	Chromate(1-), [3-hydroxy-4-[[1-hydroxy-8-sulfo-2-naphthalenyl]azo]-1-naphthalenesulfonato(4-)-], sodium	70942-15-3	Contains (regardless of intentional or impurities)	chemical products
15194	7,15-Dioxo-10,12-dithia-11-stannaheneicosanedioic acid, 11-[[2-[[6-methoxy-1,6-dioxohexyl]oxy]ethylthio]-11-methyl-6,16-dioxo-, dimethyl ester	70942-28-8	Contains (regardless of intentional or impurities)	chemical products
15195	8,14-Dioxo-9,11-dithia-10-stannanonadecanedioic acid, 10-[[2-[[5-methoxy-1,5-dioxopentyl]oxy]ethylthio]-10-methyl-5,15-dioxo-, dimethyl ester	70942-29-9	Contains (regardless of intentional or impurities)	chemical products
15196	5,10,12-Trioxa-2-aza-11-stannahexadeca-16-oic acid, 11,11-dibutyl-2-methyl-6,9,13-trioxo-, 2-(dimethylamino)ethyl ester	70942-30-2	Contains (regardless of intentional or impurities)	chemical products
15197	5,10,12-Trioxa-2-aza-11-stannahexadeca-7,14-dien-16-oic acid, 11,11-dibutyl-2-methyl-6,9,13-trioxo-, 2-(dimethylamino)ethyl ester (Z,Z)	70942-31-3	Contains (regardless of intentional or impurities)	chemical products
15198	6,14-Dioxo-9,11-dithia-10-stannanonadecanedioic acid, 10-(dibutyl-5,15-dioxo-, dimethyl ester)	70942-34-6	Contains (regardless of intentional or impurities)	chemical products
15199	7,15-Dioxo-10,12-dithia-11-stannaheneicosanedioic acid, 11-butyl-11-[[2-[[6-methoxy-1,6-dioxohexyl]oxy]ethylthio]-11-dioxo-, dimethyl ester	70942-35-7	Contains (regardless of intentional or impurities)	chemical products
15200	6,14-Dioxo-9,11-dithia-10-stannanonadecanedioic acid, 10-butyl-10-[[2-[[5-methoxy-1,5-dioxopentyl]oxy]ethylthio]-10-dioxo-, dimethyl ester	70942-36-8	Contains (regardless of intentional or impurities)	chemical products
15201	Benzothiazolium, 3-(2-carboxyethyl)-2-[[2-[[3-ethyl-5-methoxy-2(3H)-benzoselenazolylidene]methyl]-1-butenyl]-6-methoxy-5-methyl-, iodide	70942-37-9	Contains (regardless of intentional or impurities)	chemical products
15202	10-Oxa-4,6-dithia-5-stannatetracosanoic acid, 5,5-dibutyl-9-oxo-, tetradecyl ester	70942-46-0	Contains (regardless of intentional or impurities)	chemical products
15203	10-Oxa-4,6-dithia-5-stannatetracosanoic acid, 5,5-dibutyl-9-oxo-, tridecyl ester	70942-47-1	Contains (regardless of intentional or impurities)	chemical products
15204	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[2-chloroethyl]amino]sulfonyl sulfo derivatives, sodium salts	70955-63-4	Intentional addition / 1,000ppm	chemical products
15205	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[2-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]ethyl]amino]sulfonyl sulfo derivatives, sodium salts	70955-64-5	Intentional addition / 1,000ppm	chemical products
15206	Boron, (ar-ethenyl)-N,N-dimethylbenzenemethanamine(tri)hydro-, polymer with diethylenbenzene and 2-ethyl-2-[[2-methyl-1-oxo-2-propenyl]oxy]methyl]-1,3-propanediyl bis(2-methyl-2-propenoate)	70955-76-9	Intentional addition / 1%	chemical products
15207	Bis(trimethylsilyl)amidohafnium(IV) dichloride	70969-29-8	Intentional addition / 1%	chemical products
15208	Wastewater, chromium-containing	70969-49-2	Intentional addition / 1,000ppm	chemical products
15209	Propanoic acid, 3,3'-[[dibutylstannylylene]bis(thio)bis-, dipentadecyl ester	70969-63-0	Contains (regardless of intentional or impurities)	chemical products
15210	Hexanedioic acid, (dimethylstannylylene)bis(thio-2,1-ethanedioyl) dimethyl ester	70969-67-4	Contains (regardless of intentional or impurities)	chemical products
15211	Pentanedioic acid, (dimethylstannylylene)bis(thio-2,1-ethanedioyl) dimethyl ester	70969-68-5	Contains (regardless of intentional or impurities)	chemical products
15212	Thioantimonic acid (H3SbS3), tris(2-hydroxyethyl) ester	70969-69-6	Contains (regardless of intentional or impurities)	chemical products
15213	Hexanedioic acid, (dibutylstannylylene)bis(thio-2,1-ethanedioyl) dimethyl ester	70969-72-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15214	Benzenesulfonic acid, 4-hydroxy-, tin(2+) salt	70974-33-3	Intentional addition / 1,000ppm	chemical products
15215	Benzenesulfonic acid, 4-hydroxy-, nickel(2+) salt	70974-36-6	Contains (regardless of intentional or impurities)	chemical products
15216	Zirconium, tetrakis(D-gluconato)-	70983-41-4	Contains (regardless of intentional or impurities)	chemical products
15217	Benzoic acid, 2,4-dihydroxy-, copper salt, basic	70983-44-7	Intentional addition / 1,000ppm	chemical products
15218	Benzoic acid, 2-hydroxy-, copper salt, basic	70983-45-8	Intentional addition / 1,000ppm	chemical products
15219	Carbonic acid disodium salt, reaction products with silicic acid (H4SiO4) zirconium salt (1:1) and sulfuric acid	70983-50-5	Contains (regardless of intentional or impurities)	chemical products
15220	Guanidine, cyano-, polymer with N-(2-aminoethyl)-1,2-ethanediamine, hydrochloride, cupric chloride complexes	70983-56-1	Intentional addition / 1,000ppm	chemical products
15221	Spinel-group minerals, aluminum-chromium-iron-magnesium	70984-09-7	Intentional addition / 1,000ppm	chemical products
15222	Sulfonic acids, petroleum, barium calcium salts, basic, reaction products with dodecylbutanedioic acid	70984-10-0	Intentional addition / 1,000ppm	chemical products
15223	Oxirane, methanol, 4-methylbenzenesulfonate, (S)-	70987-78-9	Contains (regardless of intentional or impurities)	chemical products
15224	Cuprate(10-), [mu-[[[3,3'-[[2,5-disulfo-1,4-phenylene]bis[imino(6-chloro-1,3,5-triazine-4,2-diy)]imino(8-hydroxy-3,6-disulfo-1,7-naphthalenediylazo)]bis[4-hydroxy-1,5-naphthalenedisulfonato]](12-)]di-, decasodium	71002-21-6	Intentional addition / 1,000ppm	chemical products
15225	Cuprate(4-), [2-[[[4-chloro-6-[[4-sulfophenyl]amino]-1,3,5-triazin-2-yl]amino]-5-hydroxy-6-[[2-hydroxy-5-sulfophenyl]azo]-1,7-naphthalenedisulfonato(6-)]-, tetrasodium	71002-22-7	Intentional addition / 1,000ppm	chemical products
15226	Oxirane, mono[[C8-10-alkoxy]methyl] derivatives, reaction products with tin chloride (SnCl2)	71010-86-1	Contains (regardless of intentional or impurities)	chemical products
15227	Resin acids and Rosin acids, polymerized, indium salts	71011-07-9	Intentional addition / 1%	chemical products
15228	Resin acids and Rosin acids, polymerized, yttrium salts	71011-09-1	Intentional addition / 1%	chemical products
15229	Quaternary ammonium compounds, benzyl(hydrogenated tallow alkyl)dimethyl salts with bentonite	71011-24-0	Intentional addition / 100ppm	chemical products
15230	Quaternary ammonium compounds, benzyl(hydrogenated tallow alkyl)dimethyl salts with hectorite	71011-26-2	Intentional addition / 100ppm	chemical products
15231	Cuprate(3-), [2-[[[4-[[6-dichloro-1,3,5-triazin-2-yl]methylamino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-5-hydroxy-2-methylphenyl]azo]-1,4-benzenedisulfonato(5-)]-, trisodium	71032-92-3	Intentional addition / 1,000ppm	chemical products
15232	Chromate(2-), [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-[4-[[1-oxo-2-propenyl]amino]phenyl]-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(3-)]-[4-[[5-chloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium hydrogen	71032-93-4	Contains (regardless of intentional or impurities)	chemical products
15233	Cuprate(4-), [mu-[[[4,4'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[3-hydroxy-2,7-naphthalenedisulfonato]](8-)]bis(morpholine-N4)di-, tetrasodium	71042-99-4	Intentional addition / 1,000ppm	chemical products
15234	Sodium salt of L-2-amino-4-(hydroxymethyl)phosphinoylbutyryl-L-alanyl-L-alanine	71048-99-2	Intentional addition	chemical products
15235	Platinum(2+), bis(1,2-propanediamine-N,N)-, bis[bis(cyano-O)aurate(1-)]	71050-56-1	Contains (regardless of intentional or impurities)	chemical products
15236	Acetic acid, nickel(2+) salt, polymer with formaldehyde and 4-(1,1,3,3-tetramethylbutyl)phenol	71050-57-2	Contains (regardless of intentional or impurities)	chemical products
15237	Cobaltate(2-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamido(2-)]-, disodium	71060-75-8	Intentional addition / 1,000ppm	chemical products
15238	Chromate(1-), bis[4-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxy-N-methylbenzenesulfonamido(2-)]-, compounds with N-cyclohexylcyclohexanamine and 2-ethyl-1-hexanamine	71076-98-7	Contains (regardless of intentional or impurities)	chemical products
15239	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[2-[[2-hydroxyethyl(4-methoxy-6-sulfo-1,3,5-triazin-2-yl)amino]ethyl]amino]sulfonyl sulfo derivatives, sodium salts	71076-99-8	Intentional addition / 1,000ppm	chemical products
15240	Cuprate(4-), [4-amino-5-hydroxy-6-[[5-hydroxy-6-[[2-hydroxy-5-[[2-(sulfooxy)ethyl]sulfonyl]phenyl]azo]-7-sulfo-2-naphthalenyl]azo]-1,3-naphthalenedisulfonato(6-)]-, tetrapotassium	71097-29-5	Intentional addition / 1,000ppm	chemical products
15241	Cuprate(2-), [mu-[[[4-[[6-amino-1-hydroxy-2-naphthalenyl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-3-hydroxy-2,7-naphthalenedisulfonato(6-)]di-, disodium	71097-30-8	Intentional addition / 1,000ppm	chemical products
15242	N-(Phenylseleno)phthalimide	71098-88-9	Intentional addition / 1,000ppm	chemical products
15243	Oxirane, (chloromethyl)-, reaction products with antimony chloride (SbCl5)	71119-45-4	Contains (regardless of intentional or impurities)	chemical products
15244	Stannane, trichloromethyl-, reaction products with butyl glycidyl ether	71119-47-6	Contains (regardless of intentional or impurities)	chemical products
15245	Stannane, trichloromethyl-, reaction products with [[C8-18-alkoxy]methyl]oxirane	71119-48-7	Contains (regardless of intentional or impurities)	chemical products
15246	Stibine, trichloro-, reaction products with epichlorohydrin	71119-49-8	Contains (regardless of intentional or impurities)	chemical products
15247	Benzenesulfonic acid, 4-arsenoso-, sodium salt	71130-50-2	Contains (regardless of intentional or impurities)	chemical products
15248	Benzenesulfonic acid, 4-arsenoso-	71130-51-3	Contains (regardless of intentional or impurities)	chemical products
15249	Cycloheptacyclopolyrim, 2-butyl-6-chloro-1,3-dimethyl- perchlorate	71190-24-4	Intentional addition / 1,000ppm	chemical products
15250	Chromate(3-), tris(formato-O)[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium dihydrogen	71205-50-0	Contains (regardless of intentional or impurities)	chemical products
15251	Acetic acid, bromo- manganese(2+) salt	71215-58-2	Contains (regardless of intentional or impurities)	chemical products
15252	Antimony, tris(2-mercaptoethanolato-O,S)-	71215-72-0	Contains (regardless of intentional or impurities)	chemical products
15253	Nickel, [[2-(2'-methylenebis(thio)bis[acetato]](2-)]-,	71215-73-1	Contains (regardless of intentional or impurities)	chemical products
15254	Cuprate(2-), [4-[[[4-amino-2-hydroxy-3-[[4-nitrophenyl]azo]-5-[[[4-(4-nitro-2-sulfophenyl)amino]phenyl]azo]phenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, dihydrogen	71215-74-2	Intentional addition / 1,000ppm	chemical products
15255	Cuprate(2-), [4-[[[2,4-dihydroxy-3-[[4-nitrophenyl]azo]-5-[[[4-(4-nitro-2-sulfophenyl)amino]phenyl]azo]phenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, dihydrogen	71215-75-3	Intentional addition / 1,000ppm	chemical products
15256	Nickel(2+), tris(1,2-ethanediamine-N,N)-, (OC-6-1)-, salt with dimethylbenzenesulfonic acid (1:2)	71215-97-9	Contains (regardless of intentional or impurities)	chemical products
15257	Nickel(2+), bis(1,2-ethanediamine-N,N)-, salt with dimethylbenzenesulfonic acid (1:2)	71215-98-0	Contains (regardless of intentional or impurities)	chemical products
15258	2(3H)-Benzothiazolethione, 5-bromo-	71216-20-1	Contains (regardless of intentional or impurities)	chemical products
15259	Poly(oxy-1,2-ethanediyol), alpha-hydro-omega-hydroxy-, ester with boric acid (H3BO3), methyl ether	71243-41-9	Intentional addition / 1%	chemical products
15260	Cadmium selenide sulfide (CdSe0.53S0.47)	71243-75-9	Contains (regardless of intentional or impurities)	chemical products
15261	Calcium hafnium oxide (Ca0.1Hf0.84O1.84)	71243-76-0	Intentional addition / 1%	chemical products
15262	Calcium zirconium oxide (Ca0.1-0.2Zr0.8-0.9O1.8-1.9)	71243-77-1	Contains (regardless of intentional or impurities)	chemical products
15263	Hafnium tantalum carbide (Hf0.2Ta0.8C)	71243-79-3	Intentional addition / 1%	chemical products
15264	Hafnium yttrium oxide (Hf0.95Y0.05O2.05)	71243-80-6	Intentional addition / 1%	chemical products
15265	Indium tin oxide (In1.69Sn0.15O2.85)	71243-84-0	Contains (regardless of intentional or impurities)	chemical products
15266	Molybdenum zirconium boride silicide (Mo0.8Zr0.92B1.85Si0.15)	71243-85-1	Contains (regardless of intentional or impurities)	chemical products
15267	Tantalum zirconium carbide (Ta0.68Zr0.32C)	71243-91-9	Contains (regardless of intentional or impurities)	chemical products
15268	Nickelate(3-), [22-[[[3-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]phenyl]amino]sulfonyl]-29H,31H-phthalocyanine-1,8,15-trisulfonato(5-)-N29,N30,N31,N32]-, trisodium, (SP-4-2)-	71243-96-4	Contains (regardless of intentional or impurities)	chemical products
15269	Cobaltate(2-), [1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium hydrogen	71243-97-5	Intentional addition / 1,000ppm	chemical products
15270	Molybdenum sodium oxide (Mo4NaO6)	71251-76-8	Intentional addition / 1,000ppm	chemical products
15271	1,3,5-Triazine, 2-(1,3-benzodioxol-5-yl)-4,6-bis(trichloromethyl)-	71255-78-2	Contains (regardless of intentional or impurities)	chemical products
15272	1-Benzyl-4-phenylpiperidine-4-carbonitrile monohydrochloride	71258-18-9	Intentional addition	chemical products
15273	Benzoic acid, 2-[[2-amino-6-[[3,3'-dimethoxy-4-[[6-sulfo-1-naphthalenyl]azo]]1,1'-biphenyl]-4-yl]azo]-5-hydroxy-7-sulfo-1-naphthalenyl]azo]-5-nitro-, disodium salt	71278-41-6	Intentional addition	chemical products
15274	Piperidinoaminomethyl copper phthalocyanine	71299-09-7	Intentional addition / 1,000ppm	chemical products
15275	Tris(hexane-2,4-dionato-O,O')chromium	71308-50-4	Intentional addition / 1,000ppm	chemical products
15276	Carbonic dichloride, polymer with 4,4'-(1-methylethylidene)bis[2,6-dibromophenol], 2,4,6-tribromophenyl ester	71342-77-3	Intentional addition / 900ppm	chemical products
15277	Molybdenum, bis(ditridecylocarbomethioato)di-, mu-oxodioxo-di-, sulfonized	71342-89-7	Intentional addition / 1,000ppm	chemical products
15278	Chromate(3-), bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfophenyl)-1H-pyrazol-4-yl]azo]benzoato(3-)]-, trihydrogen	71343-04-9	Contains (regardless of intentional or impurities)	chemical products
15279	Chromate(1-), bis[2-[[1-(2-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-, sodium	71361-25-6	Contains (regardless of intentional or impurities)	chemical products
15280	Trihydrogen [5-acetamido-4-hydroxy-3-[[2-hydroxy-4-[[2-(sulphoxy)ethyl]sulphonyl]phenyl]azo]naphthalene-2,7-disulfonato(5-)]cuprate(3-)	71396-24-2	Intentional addition / 1,000ppm	chemical products
15281	Aniline phosphate	71411-85-9	Contains (regardless of intentional or impurities)	chemical products
15282	(R)-12-hydroxyoleic acid, barium cadmium salt	71411-86-0	Contains (regardless of intentional or impurities)	chemical products
15283	Barium bis(hydroxyacetate)	71411-72-8	Contains (regardless of intentional or impurities)	chemical products
15284	Dichlorobis(eta,2-ethylene)platinum, stereoisomer	71423-58-0	Contains (regardless of intentional or impurities)	chemical products
15285	Hexane, 1-bromo-4-methyl-	71434-55-4	Intentional addition / 1,000ppm	chemical products
15286	2-Hexene, 6-bromo-3-methyl-, (E)-	71435-23-9	Intentional addition / 1,000ppm	chemical products
15287	(Methanol)trimethoxyboron	71436-90-3	Intentional addition / 1%	chemical products
15288	Dihydrogen bis(hydroxysuccinato(2-)-O1,O4)cadmate(2-)	71436-99-2	Contains (regardless of intentional or impurities)	chemical products
15289	Ferrate(1-), [N-[[2-bis(carboxymethyl)amino]ethyl]-N-(2-hydroxyethyl)glycinate(3-)]-, ammonium	71437-01-9	Intentional addition / 1%	chemical products
15290	Sulfonium, diphenyl[[4-(phenylthio)phenyl]-, (OC-6-11)-hexafluoroantimonate(1-)]	71449-78-0	Contains (regardless of intentional or impurities)	chemical products
15291	Sulfonium, (chlorophenyl)diphenyl-, (OC-6-11)-hexafluoroantimonate(1-)	71463-61-1	Contains (regardless of intentional or impurities)	chemical products
15292	1,4-Cyclohexanedimethanol, polymer with (chloromethyl)oxirane	71463-68-8	Intentional addition / 1%	chemical products
15293	Cuprate(1-), [N,N-bis(carboxymethyl)glycinate(3-)-N,O,O']-, ammonium, (T-4)-	71484-80-5	Intentional addition / 1,000ppm	chemical products
15294	6,12-Dioxo-4,8-dithia-5,7-distannaoctadecanoic acid, 5,5,7,7-tetrabutyl-14-ethyl-11-oxo-, 2-ethylhexyl ester	71510-19-5	Contains (regardless of intentional or impurities)	chemical products
15295	[mu-[[1,1'-[Butane-1,4-diylbis(thiomethylene)]bis(benzene)s]]hexahydroboron	71522-75-3	Intentional addition / 1%	chemical products
15296	[mu-[[2,2'-[Ethylenebis(thio)]bis(2-methylpropane)s]]hexahydroboron	71522-78-6	Intentional addition / 1%	chemical products
15297	Benzenesulfonic acid, mono-(C15-30)-branched, dibranched, and linear-(C11-13)-alkyl derivatives, barium salts, overbased	71549-90-9	Intentional addition / 1,000ppm	chemical products
15298	Chromate(1-), bis[3-[[5,8-dichloro-1-hydroxy-2-naphthalenyl]azo]-4-hydroxybenzenesulfonamido(2-)]-, sodium	71550-00-0	Contains (regardless of intentional or impurities)	chemical products
15299	2,7-Naphthalenedisulfonic acid, 3,3'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-, tetralithium salt	71550-22-6	Intentional addition	chemical products
15300	Benzenediazonium, 2,5-dipropoxy-4-(1-pyrrolidinyl)-, tetrafluoroborate(1-)	71550-53-3	Intentional addition / 1%	chemical products
15301	Benzenediazonium, 2,5-dibutoxy-4-(1-pyrrolidinyl)-, tetrafluoroborate(1-)	71550-56-6	Intentional addition / 1%	chemical products
15302	1,3-Dimethyl-4-(2,4-dichlorobenzoyl)-5-phenacyloxypyrazole	71561-11-0	Intentional addition / 1%	chemical products
15303	Cobaltate(1-), bis[2-[[2-hydroxy-5-[[phenylamino]sulfonyl]phenyl]azo]-3-oxo-N-phenylbutanamido(2-)]-, sodium	71562-83-9	Intentional addition / 1,000ppm	chemical products
15304	Cuprate(4-), [mu-[[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulfonato]](8-)]di-, tetrasodium	71566-20-6	Intentional addition / 1,000ppm	chemical products
15305	Cuprate(4-), [mu-[[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulfonato]](8-)]di-, tetrahydrogen, compound with 2,2'-iminobis[ethano]](1,4)	71566-21-7	Intentional addition / 1,000ppm	chemical products
15306	Cuprate(2-), [29H,31H-phthalocyanine-2,16-disulfonato(4-)-N29,N30,N31,N32]-, diammonium, (SP-4-1)-	71566-22-8	Intentional addition / 1,000ppm	chemical products
15307	Copper, [N,N,N,N'-tetrakis(3-(1-methylethoxy)propyl)-29H,31H-phthalocyanine-2,9,16,23-tetrasulfonamido(2-)-N29,N30,N31,N32]-, (SP-4-1)-	71566-24-0	Intentional addition / 1,000ppm	chemical products
15308	Copper, [N2,N16-dibutyl-N9,N23-bis(2-ethylhexyl)-29H,31H-phthalocyanine-2,9,16,23-tetrasulfonamido(2-)-N29,N30,N31,N32]-, (SP-4-1)-	71566-25-1	Intentional addition / 1,000ppm	chemical products
15309	Cobaltate(1-), bis[2-[[2-hydroxy-5-nitrophenyl]azo]-3-oxo-N-phenylbutanamido(2-)]-, sodium	71566-26-2	Intentional addition / 1,000ppm	chemical products
15310	Cobaltate(1-), bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with cyclohexanamine (1:1)	71566-27-3	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15311	Chromate(1-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-N-(1-methylethyl)benzenesulfonamido(2-)]-, hydrogen, compound with 2-propanamine (1:1)	71566-29-5	Contains (regardless of intentional or impurities)	chemical products
15312	Chromate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-(1-methylethyl)benzenesulfonamido(2-)]-, hydrogen, compound with 2-propanamine (1:1)	71566-31-9	Contains (regardless of intentional or impurities)	chemical products
15313	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, [4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]chromate(1-)	71566-33-1	Contains (regardless of intentional or impurities)	chemical products
15314	Cobaltate(1-), bis[2-[[2-amino-1-naphthalenyl]azo]-5-nitrophenato(2-)]-, hydrogen	71566-34-2	Intentional addition / 1,000ppm	chemical products
15315	Cobaltate(1-), bis[3-[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamido(2-)]-, sodium	71566-39-7	Intentional addition / 1,000ppm	chemical products
15316	Benzoic acid, 2-[[2-amino-5-hydroxy-6-[[4-[[2-hydroxy-6-sulfo-1-naphthalenyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-7-sulfo-1-naphthalenyl]azo]-5-nitro-, trisodium salt	71566-41-1	Intentional addition	chemical products
15317	Guar gum, 2-hydroxypropyl ether, polymer with antimonic acid (HAS2O7) tetrapotassium salt	71566-48-8	Contains (regardless of intentional or impurities)	chemical products
15318	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-N-[3-(1-methylethoxy)propyl]benzenesulfonamido(2-)]cobaltate(1-)	71566-55-7	Intentional addition / 1,000ppm	chemical products
15319	1,1,7,7-Tetrachloroheptane	71570-98-4	Intentional addition / 1,000ppm	chemical products
15320	Boric acid, B-(4-hydroxyphenyl)-	71597-85-8	Intentional addition / 1%	chemical products
15321	Chromate(1-), bis[3-[[4,5-dihydro-4-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-4-yl]benzenesulfonamido(2-)]-, sodium	71598-27-1	Contains (regardless of intentional or impurities)	chemical products
15322	Chromate(1-), bis[2-[[1-(2-ethylphenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-, hydrogen	71598-32-8	Contains (regardless of intentional or impurities)	chemical products
15323	Chromate(1-), [2-(3-chlorophenyl)-2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]N-[7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, hydrogen	71598-33-9	Contains (regardless of intentional or impurities)	chemical products
15324	Chromate(1-), bis[methyl 7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl]carbamato(2-)]-, hydrogen	71598-34-0	Contains (regardless of intentional or impurities)	chemical products
15325	Chromate(1-), bis[2-(3-chlorophenyl)-2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]-, hydrogen	71598-35-1	Contains (regardless of intentional or impurities)	chemical products
15326	Cuprate(2-), [4-hydroxy-3-[[2-hydroxy-5-sulfo]phenyl]azo]-7-[[2,5,6-trichloro-4-pyrimidinyl]amino]-2-naphthalenesulfonato(4-)]-, disodium	71598-36-2	Intentional addition / 1,000ppm	chemical products
15327	2-Butenedioic acid (Z)-, mono-octadecyl ester, cadmium salt	71599-06-9	Contains (regardless of intentional or impurities)	chemical products
15328	5,7,9,14-Tetraoxa-6,8-distannaoctadeca-2,11-dienoic acid, 6,6,8,8-tetrabutyl-4,10,13-trioxo-, butyl ester, (Z,Z)	71599-08-1	Intentional addition / 1,000ppm	chemical products
15329	C.I. Acid Yellow 220	71603-79-7	Intentional addition / 1%	chemical products
15330	Nickel, bis[N-hydroxy-3-(hydroxyimino)-N'-(2-methoxyphenyl)butanimidamido-N,N3]-	71605-83-9	Contains (regardless of intentional or impurities)	chemical products
15331	Chromium, 4,4-bis[(gamma-omega-perfluoro-C8-20-alkyl)thio]pentanoate chloro hydroxy complexes	71608-45-2	Contains (regardless of intentional or impurities)	chemical products
15332	Chromium, chloro hydroxy 5-[(gamma-omega-perfluoro-C8-20-alkyl)thio]bicyclo[2.2.1]heptane-2,3-dicarboxylate complexes	71608-46-3	Contains (regardless of intentional or impurities)	chemical products
15333	Copper, [29H,31H-phthalocyanine-C.O.C-trisulfonamido(2-)-N29.N30.N31.N32]-, triethyl salt	71617-30-6	Intentional addition / 1,000ppm	chemical products
15334	Cuprate(5-), [4-amino-5-hydroxy-6-[[5-hydroxy-6-[[2-hydroxy-3-sulfo-5-[[2-(sulfo)oxyethyl]sulfonyl]phenyl]azo]-7-sulfo-2-naphthalenyl]azo]-1,3-naphthalenedisulfonato(7-)]-, pentapotassium	71617-68-0	Intentional addition / 1,000ppm	chemical products
15335	Cuprate(3-), [mu-5-[[4-[[6-[[4-[[2-carboxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-2-hydroxy-4-sulfo-1-naphthalenyl]azo]-3-hydroxy-7-sulfo-1-naphthalenyl]azo]-2-hydroxybenzoato(7-)]di-, trisodium	71617-70-4	Intentional addition / 1,000ppm	chemical products
15336	Ashes, residues, rice husk	71630-92-7	Contains (regardless of intentional or impurities)	chemical products
15337	C.I. Pigment Black 30	71631-15-7	Contains (regardless of intentional or impurities)	chemical products
15338	Chromate(1-), bis[2-chloro-4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-hydroxybenzenesulfonamido(2-)]-, hydrogen	71648-65-2	Contains (regardless of intentional or impurities)	chemical products
15339	Glucose 1-(barium phosphate)	71662-16-3	Contains (regardless of intentional or impurities)	chemical products
15340	Ammonium gold(1+) sulphate	71662-32-3	Intentional addition	chemical products
15341	Iron, complexes with diazotized 2-amino-4,6-dinitrophenol monosodium salt coupled with diazotized 4-amino-5-hydroxy-2,7-naphthalenedisulfonic acid, diazotized 4-amino-3-methylbenzenesulfonic acid, diazotized 4-nitrobenzenamine and resorcinol	71662-50-5	Intentional addition / 1%	chemical products
15342	1,2,4,9-Tetrachlorodibenzo-p-dioxin	71665-99-1	Intentional addition / 1,000ppm	chemical products
15343	1,2,7,9-Tetrachlorodibenzo(b,e)(1,4)dioxin	71669-23-3	Intentional addition / 1,000ppm	chemical products
15344	1,3,6,9-Tetrachlorodibenzo(b,e)(1,4)dioxin	71669-24-4	Intentional addition / 1,000ppm	chemical products
15345	1,2,3,6-Tetrachlorodibenzo(b,e)(1,4)dioxin	71669-25-5	Intentional addition / 1,000ppm	chemical products
15346	1,2,3,9-Tetrachlorodibenzo(b,e)(1,4)dioxin	71669-26-6	Intentional addition / 1,000ppm	chemical products
15347	1,2,4,6-Tetrachlorodibenzo(b,e)(1,4)dioxin	71669-27-7	Intentional addition / 1,000ppm	chemical products
15348	1,2,4,7-Tetrachlorodibenzo(b,e)(1,4)dioxin	71669-28-8	Intentional addition / 1,000ppm	chemical products
15349	1,2,4,8-Tetrachlorodibenzo(b,e)(1,4)dioxin	71669-29-9	Intentional addition / 1,000ppm	chemical products
15350	Iron tris(4-cyclohexylbutyrate)	71672-87-2	Intentional addition / 1%	chemical products
15351	Chromate(1-), [N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]acetamidato(2-)]1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen, compound with N-cyclohexylcyclohexanamine (1:1)	71701-12-7	Contains (regardless of intentional or impurities)	chemical products
15352	Chromate(1-), bis[2-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-, sodium	71701-13-8	Contains (regardless of intentional or impurities)	chemical products
15353	Cobaltate(1-), bis[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamido(2-)]-, sodium	71701-14-9	Intentional addition / 1,000ppm	chemical products
15354	Chromate(1-), bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-, hydrogen, compound with 2-ethyl-1-hexanamine (1:1)	71701-15-0	Contains (regardless of intentional or impurities)	chemical products
15355	Chromate(1-), bis[4-[[1-(3-cyanophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxy-N-methylbenzenesulfonamido(2-)]-, sodium	71701-16-1	Contains (regardless of intentional or impurities)	chemical products
15356	3-Octene, 4-bromo-2,2-dimethyl-, (E)-	71720-23-5	Intentional addition / 1,000ppm	chemical products
15357	3-Octene, 4-bromo-2,2-dimethyl-, (Z)-	71720-24-6	Intentional addition / 1,000ppm	chemical products
15358	Ethyl hydrogen sulphate, nickel(2+) salt	71720-48-4	Contains (regardless of intentional or impurities)	chemical products
15359	Phosphoric acid, vanadium(3+) salt (1:1)	71724-93-1	Intentional addition / 1%	chemical products
15360	Barium pentafluorobenzenesulphonate	71735-31-4	Contains (regardless of intentional or impurities)	chemical products
15361	Cobaltate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]amino]-N-(3-methoxypropyl)benzenesulfonamido(2-)]-, sodium	71735-52-9	Intentional addition / 1,000ppm	chemical products
15362	Cuprate(5-), [mu-3-[[6-[[3,3-dihydroxy-4'-[[1-hydroxy-3,8-disulfo-2-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-1,5-dihydroxy-7-sulfo-2-naphthalenyl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(11-)]tri-, pentasodium	71735-53-0	Intentional addition / 1,000ppm	chemical products
15363	Cuprate(4-), [mu-3-[[7-[[6-[[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-1,5-dihydroxy-7-sulfo-2-naphthalenyl]azo]-8-hydroxy-1,3,6-naphthalenetrifluorosulfonato(10-)]tri-, tetrahydrogen	71735-54-1	Intentional addition / 1,000ppm	chemical products
15364	Chromate(1-), bis[3-[[4-[[5-chloro-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-N-(2-hydroxyethyl)benzenesulfonamido(2-)]-, sodium	71735-55-2	Contains (regardless of intentional or impurities)	chemical products
15365	Cuprate(2-), [mu-2-[[6-[[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-5-hydroxy-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(6-)]di-, hydrogen	71735-56-3	Intentional addition / 1,000ppm	chemical products
15366	Cuprate(3-), [4-hydroxy-3-[[2-hydroxy-5-sulfo]phenyl]azo]-5-[[2,5,6-trichloro-4-pyrimidinyl]amino]-2,7-naphthalenedisulfonato(5-)]-, trihydrogen	71735-57-4	Intentional addition / 1,000ppm	chemical products
15367	Chromate(2-), [1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]3-hydroxy-4-[[2-hydroxy-3,5-dinitrophenyl]azo]-7-[[4-methoxyphenyl]amino]-2-naphthalenesulfonato(3-)]-, disodium	71735-58-5	Contains (regardless of intentional or impurities)	chemical products
15368	Cobaltate(1-), bis[N-[2-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-5-methylphenyl]acetamidato(2-)]-, sodium	71735-59-6	Intentional addition / 1,000ppm	chemical products
15369	Cuprate(4-), [7-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-4-hydroxy-3-[[2-hydroxy-4,7-disulfo-1-naphthalenyl]azo]-1,5-naphthalenedisulfonato(6-)]-, tetrapotassium	71735-60-9	Intentional addition / 1,000ppm	chemical products
15370	Cobaltate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-(3-methoxypropyl)benzenesulfonamido(2-)]-, sodium	71735-61-0	Intentional addition / 1,000ppm	chemical products
15371	Cuprate(4-), [5-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-[[[2-hydroxy-3,5-disulfo]phenyl]azo](2-sulfo)phenyl]methyl]azo]benzoato(6-)]-, tetrasodium	71735-62-1	Intentional addition / 1,000ppm	chemical products
15372	Cuprate(4-), [2-[[[2-hydroxy-3,5-disulfo]phenyl]azo][3-[[4-[[2,5,6-trichloro-4-pyrimidinyl]amino]phenyl]azo]phenyl]methyl]azo]-5-sulfo]benzoato(6-)]-, tetrasodium	71735-63-2	Intentional addition / 1,000ppm	chemical products
15373	Cuprate(4-), [8-hydroxy-7-[[2-hydroxy-4-[[2-methoxy-3-(4-pyrimidinylamino)-3-sulfo]phenyl]azo]phenyl]azo]-1,3,6-naphthalenetrifluorosulfonato(6-)]-, tetrasodium	71735-64-3	Intentional addition / 1,000ppm	chemical products
15374	Cuprate(4-), [8-hydroxy-7-[[2-hydroxy-7-sulfo-6-[[4-[[2,5,6-trichloro-4-pyrimidinyl]amino]phenyl]azo]-1-naphthalenyl]azo]-1,3,6-naphthalenetrifluorosulfonato(6-)]-, tetrasodium	71735-65-4	Intentional addition / 1,000ppm	chemical products
15375	Propionic acid, ammonium copper salt	71745-82-9	Intentional addition / 1,000ppm	chemical products
15376	C.I. Pigment Brown 39	71750-83-9	Contains (regardless of intentional or impurities)	chemical products
15377	Abamectin	71751-41-2	Contains (regardless of intentional or impurities)	chemical products
15378	Nickel uranyl tetraacetate, of uranium depleted in uranium-235	71767-12-9	Contains (regardless of intentional or impurities)	chemical products
15379	Chromate(1-), bis[3-[[9-[[dimethylamino]sulfonyl]amino]-2-hydroxy-1-naphthalenyl]azo]-4-hydroxybenzenesulfonamido(2-)]-, sodium	71767-18-5	Contains (regardless of intentional or impurities)	chemical products
15380	Acetic acid reaction products with ethylene glycol and molybdenum oxide (MoO3)	71786-41-9	Contains (regardless of intentional or impurities)	chemical products
15381	Chromium, 3-[[[3-chlorophenyl]amino]-1-naphthalenyl]azo]-4-hydroxybenzenesulfonamide 2-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-[[methylamino]sulfonyl]benzoate sodium complexes	71786-50-0	Intentional addition / 1,000ppm	chemical products
15382	Chromium, 3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamide 2-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-[[methylamino]sulfonyl]benzoate 3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamide complexes	71786-51-1	Intentional addition / 1,000ppm	chemical products
15383	Chromium, 2-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-[[methylamino]sulfonyl]benzoate 4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-(3-methoxypropyl)benzenesulfonamide complexes	71786-52-2	Intentional addition / 1,000ppm	chemical products
15384	Chromium, 3-[[8-[[[dimethylamino]sulfonyl]amino]-2-hydroxy-1-naphthalenyl]azo]-4-hydroxybenzenesulfonamide 4-hydroxy-3-[[2-(phenylamino)-1-naphthalenyl]azo]benzenesulfonamide complexes	71786-53-3	Intentional addition / 1,000ppm	chemical products
15385	Cobalt, 6-amino-5-[[2-hydroxy-4-nitrophenyl]azo]-N-(2-hydroxypropyl)-2-naphthalenesulfonamide 2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-N-(2-ethylhexyl)-3-oxobutanamide sodium complexes	71786-54-4	Intentional addition / 1%	chemical products
15386	Copper, [[[[3-(5-chloro-2,6-difluoro-4-pyrimidinyl)amino]phenyl]amino]sulfonyl]-29H,31H-phthalocyaninato(2-)-N29.N30.N31.N32]-, aminosulfonyl sulfo derivatives, sodium salts	71786-55-5	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15387	Ethanedioic acid, reaction products with ethylene glycol and molybdenum oxide (MoO3)	71786-59-9	Contains (regardless of intentional or impurities)	chemical products
15388	Boric acid (H3BO3), compound with (Z)-N-9-octadecene-1,3-propanediamine	71786-64-6	Intentional addition / 1%	chemical products
15389	Iodonium bis(4-dodecylphenyl)-, (OC-6-11)-hexafluoroantimonate(1-)	71786-70-4	Contains (regardless of intentional or impurities)	chemical products
15390	Yttrium zirconium oxide (Y0.06-0.11Zr0.94-0.97O2.03-2.06)	71799-67-2	Contains (regardless of intentional or impurities)	chemical products
15391	Manganese citrate	71799-92-3	Contains (regardless of intentional or impurities)	chemical products
15392	Fatty acids, coco, reaction products with borax, potassium hydroxide and sodium lauryl sulfate	71808-40-7	Intentional addition / 1%	chemical products
15393	C.I. Solvent Red 164	71819-51-7	Intentional addition / 1,000ppm	chemical products
15394	Boric acid (H3BO3), reaction products with 2-amino-2-(hydroxymethyl)-1,3-propanediol and succinic anhydride monopolybutenyl derivative	71820-29-6	Intentional addition / 1%	chemical products
15395	Stannous ricinoleate	71828-07-4	Intentional addition / 1,000ppm	chemical products
15396	Disperse Blue 192	71838-51-2	Intentional addition / 1,000ppm	chemical products
15397	9-Octadecenoic acid (Z)-, 2-(hydroxymethyl)-2-[[[1-oxo-9-octadecenoxy]methyl]-1,3-propanediyl ester, (Z)-, ester with boric acid (H3BO3)	71839-42-4	Intentional addition / 1%	chemical products
15398	9-Octadecene-1-ol, (Z)-, ester with boric acid (H3BO3)	71839-43-5	Intentional addition / 1%	chemical products
15399	9-Octadecenoic acid (Z)-, mixed esters with boric acid (H3BO3), nonanoic acid and trimethylolpropane	71839-47-9	Intentional addition / 1%	chemical products
15400	9-Octadecenoic acid (Z)-, mixed esters with boric acid (H3BO3), nonanoic acid and pentaerythritol	71839-48-0	Intentional addition / 1%	chemical products
15401	Cobaltate(1-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-(1-methylethyl)benzenesulfonamidato(2-)]-, hydrogen, compound with 2-propanamine (1:1)	71839-74-2	Intentional addition / 1,000ppm	chemical products
15402	Cobaltate(1-), bis[N-(7-hydroxy-8-[[2-hydroxy-5-[[methylamino)sulfonyl]phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, hydrogen, compound with 2-propanamine (1:1)	71839-76-4	Intentional addition / 1,000ppm	chemical products
15403	Chromate(1-), bis[3-[[4-[[5-(1,1-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, sodium	71839-77-5	Contains (regardless of intentional or impurities)	chemical products
15404	Chromate(1-), bis[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen, compound with 1,6-hexanediamine (1:1)	71839-79-7	Contains (regardless of intentional or impurities)	chemical products
15405	Chromate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-(3-methoxypropyl)benzenesulfonamidato(2-)]-, sodium	71839-80-0	Contains (regardless of intentional or impurities)	chemical products
15406	Chromate(1-), bis[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamidato(2-)]-, sodium	71839-81-1	Contains (regardless of intentional or impurities)	chemical products
15407	Chromate(1-), bis[3-[[4-[[5-chloro-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-N-(2-hydroxyethyl)benzenesulfonamidato(2-)]-, hydrogen, compound with N-cyclohexylcyclohexanamine (1:1)	71839-83-3	Contains (regardless of intentional or impurities)	chemical products
15408	Cobaltate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]-, hydrogen, compound with 2-propanamine (1:1)	71839-84-4	Intentional addition / 1,000ppm	chemical products
15409	Chromate(1-), bis[methyl 7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl]carbamato(2-)]-, sodium	71839-85-5	Contains (regardless of intentional or impurities)	chemical products
15410	Cobaltate(1-), bis[2-chloro-5-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-N-methylbenzenesulfonamidato(2-)]-, hydrogen, compound with cyclohexanamine (1:1)	71839-87-7	Intentional addition / 1,000ppm	chemical products
15411	Cobaltate(1-), bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	71839-88-8	Intentional addition / 1,000ppm	chemical products
15412	Chromate(1-), bis[N-(7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, hydrogen, compound with N-cyclohexylcyclohexanamine (1:1)	71839-90-2	Contains (regardless of intentional or impurities)	chemical products
15413	Chromate(1-), bis[2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	71839-91-3	Contains (regardless of intentional or impurities)	chemical products
15414	2-Butenoic acid, 4-[[di(2-oxoethyl)oxy]-4-oxo-, butyl ester, (2Z)-	71850-71-0	Contains (regardless of intentional or impurities)	chemical products
15415	2-Butenedioic acid (Z)-, monoisobutyl ester, trianhydride with antimonio acid (H3SbO3)	71850-72-1	Contains (regardless of intentional or impurities)	chemical products
15416	2-Butenedioic acid (Z)-, monoisobutyl ester, dianhydride with antimonio acid (H3SbO3) isooctyl ester	71850-86-7	Contains (regardless of intentional or impurities)	chemical products
15417	2-Butenedioic acid (Z)-, monoisobutyl ester, trianhydride with antimonio acid (H3SbO3)	71850-87-8	Contains (regardless of intentional or impurities)	chemical products
15418	2-Butenoic acid, 4-[[bis(isooctyl)oxy]stibino]oxy]-4-oxo-, isooctyl ester, (2Z)-	71850-88-9	Contains (regardless of intentional or impurities)	chemical products
15419	1-Butanamine, tetrafluoroborate(1-), (1:1)	71852-73-8	Intentional addition / 1%	chemical products
15420	Tetra- $\mu$ -chlorodichlorobis[2-[[[2,3-dihydroxypropoxy]hydroxyphosphoryl]oxy]triethylmethylammonium]trichloridate, stereoisomer	71861-27-3	Contains (regardless of intentional or impurities)	chemical products
15421	Dibutyl tin sulfide polymer	71865-66-2	Intentional addition / 1,000ppm	chemical products
15422	1-Propanone, 2-methyl-1-[[4-(methylthio)phenyl]-2-(4-morpholinyl)-	71868-10-5	Contains (regardless of intentional or impurities)	chemical products
15423	Cuprate(4-), [mu-[[2,2-[[1-(2-ethenediyl)bis[[3-hydroxy-4-[[2-hydroxy-5-sulfophenyl]azo]phenyl]azo]benzenesulfonato(8-)]]]di-, tetrasodium	71873-62-6	Intentional addition / 1,000ppm	chemical products
15424	Cuprate(4-), [mu-[[7-[[3,3'-dihydroxy-4-[[4-hydroxy-2-sulfobenzoyl]phenazin-3-yl]azo][1,1'-biphenyl]-4-yl]azo]-8-hydroxy-1,3,6-naphthalenetrisulfonato(8-)]]]di-, tetrasodium	71873-63-7	Intentional addition / 1,000ppm	chemical products
15425	Sodium tris(hydroxyacetato-O1,O2)oxozirconate(1-)	71888-59-0	Contains (regardless of intentional or impurities)	chemical products
15426	Molybdenum tungsten oxide, silica and sulfur containing	71888-83-0	Intentional addition / 1,000ppm	chemical products
15427	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, 4-[[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-1-phenyl-3H-pyrazol-3-one 4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-1-phenyl-3H-pyrazol-3-one 3-[[1-[[2-ethylhexyl]amino]carbonyl]-2-oxopropyl]azo]-2-hydroxy-5-nitrobenzoate cobaltate complexes	71888-93-2	Intentional addition / 1%	chemical products
15428	Cuprate(6-), [mu-[[2,2-[[1,4-dioxo-2-butene-1,4-diyl]bis[imino(2-sulfo-4,1-phenylene)-2,1-ethenediyl(3-sulfo-4,1-phenylene)4,5-dihydro-3-methyl-5-oxo-1H-pyrazole-4,1-diyl]azo]bis[5-sulfobenzato(10-)]]]di-, hexasodium	71889-03-7	Intentional addition / 1,000ppm	chemical products
15429	Cuprate(4-), [4-[[4-[[4-[[2-[[3-hydroxy-4-[[2-hydroxy-5-sulfophenyl]azo]phenyl]azo]-2-sulfophenyl]ethenyl]-3-sulfophenyl]-ONN-azoxy]phenyl]azo]benzoato(6-)]-, tetrasodium	71889-04-8	Intentional addition / 1,000ppm	chemical products
15430	Benzenemethanol, 4-amino- $\alpha$ -(4-amino-3,5-dimethylphenyl)- $\alpha$ -((2,6-dichlorophenyl)-3,5-dimethyl-, monoester with boric acid (H3BO3)	71889-05-9	Intentional addition / 1%	chemical products
15431	Nickel, [N-(4-chlorophenyl)-2-[3-[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]methylene]hydrazino)-1H-isindol-1-ylidene]-2-cyanoacetamidato(2-)]-	71889-20-8	Contains (regardless of intentional or impurities)	chemical products
15432	Chromate(3-), bis[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, trihydrogen, compound with 1,6-hexanediamine (1:1)	71889-21-9	Contains (regardless of intentional or impurities)	chemical products
15433	Nickel, [mu-[[piperazine-N1,N4]]bis[3-[[1-[[4,5,6,7-tetrachloro-1-oxo-1H-isindol-3-yl]hydrazono]ethyl]-2,4-(1H,3H)-quinolinedionato(2-)]]]di-	71889-22-0	Contains (regardless of intentional or impurities)	chemical products
15434	1,4-Benzenedicarboxylic acid, copper(2+) salt (1:1), monohydrate	71889-43-5	Intentional addition / 1,000ppm	chemical products
15435	Cyclohexylammonium tetrafluoroborate(1-)	71893-43-1	Intentional addition / 1%	chemical products
15436	Chromate(1-), bis[2-chloro-4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-hydroxybenzenesulfonato(2-)]-, hydrogen, compound with 1,6-hexanediamine (1:1)	71902-28-8	Contains (regardless of intentional or impurities)	chemical products
15437	Cyclohexene, 1-methyl-4-(1-methylethynyl)-, (4R)-, dimer	71911-41-6	Intentional addition / 1%	chemical products
15438	1,2,3,6,7-Pentachlorodibenzo(b,e)(1,4)dioxin	71925-15-0	Intentional addition / 1,000ppm	chemical products
15439	1,2,3,6,8-Pentachlorodibenzo(b,e)(1,4)dioxin	71925-16-1	Intentional addition / 1,000ppm	chemical products
15440	1,2,3,7,9-Pentachlorodibenzo(b,e)(1,4)dioxin	71925-17-2	Intentional addition / 1,000ppm	chemical products
15441	1,2,3,8,9-Pentachlorodibenzo(b,e)(1,4)dioxin	71925-18-3	Intentional addition / 1,000ppm	chemical products
15442	Thallium(3+) trifluoromethanesulfonate	71929-23-2	Contains (regardless of intentional or impurities)	chemical products
15443	Nickel bromide (NiBr)	71939-11-2	Contains (regardless of intentional or impurities)	chemical products
15444	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfonated, sodium salts	71949-28-5	Intentional addition / 1,000ppm	chemical products
15445	2-Propenoic acid, 1,1-[[2-(hydroxymethyl)-2-[[[1-oxo-2-propen-1-yl]oxy]methyl]-1,3-propanediyl] ester, reaction products with antimonio acid (H3SbO3) tributyl ester	71949-30-9	Contains (regardless of intentional or impurities)	chemical products
15446	Bis(D-gluconato-O1,O2)nickel	71957-07-8	Contains (regardless of intentional or impurities)	chemical products
15447	Cobalt(2+) gluconate	71957-08-9	Intentional addition / 1,000ppm	chemical products
15448	Cuprate(1-), [C,C-bis(aminosulfonyl)-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, sodium, disodium salt	71962-07-7	Intentional addition / 1,000ppm	chemical products
15449	Cobalt(III) sephalchrate trichloride	71963-57-0	Intentional addition / 1%	chemical products
15450	Anilinium toluenesulfonate	71965-02-1	Contains (regardless of intentional or impurities)	chemical products
15451	Hydroxy(nitrate-O)oxozirconium	71965-17-8	Contains (regardless of intentional or impurities)	chemical products
15452	Tetrafluorodioxodivanadium	71965-21-4	Intentional addition / 1%	chemical products
15453	Hydroxytris(hydroxyacetato-O1,O2)zirconium	71975-59-2	Contains (regardless of intentional or impurities)	chemical products
15454	Ferrate(3-), tris[4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(2-)]]]di-, trihydrogen	71990-21-1	Intentional addition / 1%	chemical products
15455	1,2,4,6,8-Pentachlorodibenzo(b,e)(1,4)dioxin	71998-76-0	Intentional addition / 1,000ppm	chemical products
15456	Di-3-tolyl-4-tolyl phosphate	72016-32-1	Intentional addition / 1,000ppm	chemical products
15457	Acetic acid, bis(nitritoltri-, antimony complex	72017-60-8	Contains (regardless of intentional or impurities)	chemical products
15458	Chromate(2-), [4-[[5-chloro-2-hydroxy-3-nitrophenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]]]3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-2-hydroxybenzoato(8-)]]]di-, disodium	72017-66-4	Contains (regardless of intentional or impurities)	chemical products
15459	Zirconium, oxobis(thiocyanato-S)-	72017-87-9	Contains (regardless of intentional or impurities)	chemical products
15460	Hafnium, oxobis(thiocyanato-S)-	72017-88-0	Intentional addition / 1%	chemical products
15461	Molybdenum, bis(O,O-bis(2-ethylhexyl) phosphorodithioato-S,S)dioxido- $\mu$ -thioxido-, (Mo-Mo)	72030-25-2	Contains (regardless of intentional or impurities)	chemical products
15462	Pyrindine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, 2-hydroxy-1,2,3-propanetricarboxylate (1:1)	72057-10-4	Contains (regardless of intentional or impurities)	chemical products
15463	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, phosphate (1:1)	72057-11-5	Contains (regardless of intentional or impurities)	chemical products
15464	Cuprate(4-), [mu-[[5-[[4-[[8-[[2,4-dihydroxy-3-[[2-hydroxy-5-sulfophenyl]azo]phenyl]azo]-1-hydroxy-3,6-disulfo-2-naphthalenyl]azo]-3-hydroxy-3-methoxy[1,1'-biphenyl]-4-yl]azo]-2-hydroxybenzoato(8-)]]]di-, tetrasodium	72066-64-9	Intentional addition / 1,000ppm	chemical products
15465	Bis(3-acetyl-6-methyl-2H-pyran-2,4(3H)-dione), barium salt	72072-38-9	Contains (regardless of intentional or impurities)	chemical products
15466	Propane, bromotrifluoro-	72101-30-5	Intentional addition / 1,000ppm	chemical products
15467	Molybdenum, 2-ethylhexyl phosphates oxo complexes	72102-38-6	Intentional addition / 1,000ppm	chemical products
15468	Cobaltate(2-), [2,4-diamino-6-[[2-(phenylamino)-1-naphthalenyl]azo]phenolato(2-)]]]3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium hydrogen	72102-52-4	Intentional addition / 1,000ppm	chemical products
15469	Piperazinium, 4-(ethoxycarbonyl)-1-(3,5,5-trimethyl-2-cyclohexen-1-ylidene)-, tetrafluoroborate(1-)	72102-88-6	Intentional addition / 1%	chemical products
15470	1H,5H,11H,15H-Xanthene[2,3,4-ij:5,6,7-ij']diquinolin-18-ium, 9-(2-carboxyphenyl)-2,3,6,7,12,13,16,17-octahydro-, perchlorate	72102-91-1	Intentional addition / 1,000ppm	chemical products
15471	Tungsten alloy, base, W 62Ru 34Al 2.3B 0.9	72125-29-2	Intentional addition / 1%	chemical products
15472	Cuprate(2-), [4-hydroxy-5-[[2-hydroxy-5-methylphenyl]azo]-1,3-benzenedisulfonato(4-)]-, disodium	72139-06-1	Intentional addition / 1,000ppm	chemical products
15473	Chromate(7-), bis[3-[[2-amino-5-hydroxy-7-[[2-hydroxy-5-nitro-3-sulfophenyl]azo]-1-naphthalenyl]azo]-2-hydroxy-5-sulfobenzato(5-)]-, hexasodium hydrogen	72139-07-2	Contains (regardless of intentional or impurities)	chemical products
15474	Nickelate(8-), bis[3-[[2-amino-8-hydroxy-6-sulfo-1-naphthalenyl]azo]-2-hydroxy-5-sulfobenzato(5-)]-, hexasodium dihydrogen	72139-08-3	Contains (regardless of intentional or impurities)	chemical products
15475	Cuprate(2-), [4-hydroxy-5-[[1,2,3,4-tetrahydro-2,4-dioxo-3-quinolinyl]azo]-1,3-benzenedisulfonato(4-)]-, disodium	72139-09-4	Intentional addition / 1,000ppm	chemical products
15476	Cuprate(4-), [7-[[5-chloro-2,6-difluoro-4-pyrimidinylamino]-3-[[2,8-dihydroxy-4,6-disulfo-1-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)]-, tetrasodium	72139-10-7	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15477	Cuprate(4-), [mu-[[[3-[[2,5-dihydroxy-6-[[2-hydroxy-5-sulfo-3-[[2,5,6-trichloro-4-pyrimidinylamino]phenyl]azo]-8-sulfo-1-naphthalenyl]azo]-4-hydroxy-1,7-naphthalenedisulfonato(8-)]]]di-, tetrasodium	72139-11-8	Intentional addition / 1,000ppm	chemical products
15478	Sulfonium, (2-cyano-1-methylthyl)dodecylethyl-, tetrafluoroborate(1-)	72140-65-9	Intentional addition / 1%	chemical products
15479	Platinum, dichlorobis(4-methylpyridine)-	72151-35-0	Contains (regardless of intentional or impurities)	chemical products
15480	C.I. Reactive green 12	72152-45-5	Contains (regardless of intentional or impurities)	chemical products
15481	Cuprate(2-), [3-[[5-chloro-2,6-difluoro-4-pyrimidinylamino]-5-[[1-[[2-chloro-5-sulfo]phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonato(4-)]-, disodium	72152-46-6	Intentional addition / 1,000ppm	chemical products
15482	Cuprate(3-), [2-[[4,5-dihydro-4-[[2-hydroxy-5-sulfo-3-[[2,5,6-trichloro-4-pyrimidinylamino]phenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]-1,4-benzenedisulfonato(5-)]-, trisodium	72152-47-7	Intentional addition / 1,000ppm	chemical products
15483	Cuprate(4-), [29H,31H-phthalocyanine-1,8,15,23-tetrasulfonato(6-)-N29,N30,N31,N32]-, tetrahydrogen, (SP-4-2-)	72152-55-7	Intentional addition / 1,000ppm	chemical products
15484	Cuprate(4-), [5-[[[7-[[5-chloro-2-hydroxy-3-sulfo]phenyl]azo]-8-hydroxy-3,6-disulfo-1-naphthalenyl]amino]sulfonyl]-2-hydroxybenzoato(6-)]-, trisodium hydrogen	72152-68-2	Intentional addition / 1,000ppm	chemical products
15485	Cuprate(2-), [4-hydroxy-5-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]-1,3-benzenedisulfonato(4-)]-, disodium	72152-69-3	Intentional addition / 1,000ppm	chemical products
15486	Cuprate(3-), [5-[[4,5-dihydro-4-[[2-hydroxy-3,5-disulfo]phenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]-2-hydroxybenzoato(5-)]-, trisodium	72152-70-6	Intentional addition / 1,000ppm	chemical products
15487	Cuprate(2-), [6-hydroxy-5-[[2-hydroxy-5-sulfo]phenyl]azo]-2-naphthalenesulfonato(4-)]-, disodium	72152-71-7	Intentional addition / 1,000ppm	chemical products
15488	Silicic acid, barium magnesium zinc salt	72162-08-4	Intentional addition / 1,000ppm	chemical products
15489	Sulfuric acid, nickel salt, reaction products with sulfurized calcium phenolate	72162-32-4	Contains (regardless of intentional or impurities)	chemical products
15490	Trichloro[1,1,1-tri-tert-butylsilylamino]boron	72169-17-6	Intentional addition / 1%	chemical products
15491	Ferrate(4-), [3-[[2-amino-5-hydroxy-6-[[2-hydroxy-5-nitro-3-sulfo]phenyl]azo]-7-sulfo-1-naphthalenyl]azo]-2-hydroxy-5-sulfobenzoato(6-)]-, tetrasodium	72187-17-8	Intentional addition / 1%	chemical products
15492	Copper, dichloro pyridine complexes	72207-64-8	Intentional addition / 1,000ppm	chemical products
15493	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chloro sulfo derivatives	72207-65-9	Intentional addition / 1,000ppm	chemical products
15494	Iron, complexes with coupled 1-(2,4-dihydroxyphenyl)ethanone-7-nitronaphth[1,2-d][1,2,3]oxadiazole-5-sulfonic acid	72207-76-2	Intentional addition / 1%	chemical products
15495	Iron, complexes with diazotized 5-amino-2-(phenylamino)benzenesulfonic acid monosodium salt coupled with 4-[[2-hydroxy-3,5-dinitro]phenyl]azo]-1,3-benzenediol, diazotized 4-nitrobenzamide and diazotized 3-aminobenzenesulfonic acid monosodium salt	72207-77-3	Intentional addition / 1%	chemical products
15496	Cuprate(5-), [4-amino-3-[[2,5-disulfo]phenyl]azo]-5-hydroxy-6-[[2-hydroxy-5-[[2-sulfo]oxyethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(7-)]-, pentahydrogen	72208-06-1	Intentional addition / 1,000ppm	chemical products
15497	Cobaltate(2-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, disodium, (OC-6-22)	72208-07-2	Intentional addition / 1,000ppm	chemical products
15498	2-Naphthalenecarboxamide, 3-hydroxy-4-[[2-methoxy-5-nitro]phenyl]azo]-N-(3-nitrophenyl)-, barium salt (2:1)	72209-03-1	Intentional addition / 1,000ppm	chemical products
15499	Cuprate(2-), [C-[[[3-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]phenyl]amino]sulfonyl]-C-(aminosulfonyl)-29H,31H-phthalocyanine-C,C-disulfonato(4-)-N29,N30,N31,N32]-, disodium	72214-17-6	Intentional addition / 1,000ppm	chemical products
15500	Nickelate(3-), [C-[[[3-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]phenyl]amino]sulfonyl]-C,C,C-tris(aminosulfonyl)-29H,31H-phthalocyanine-C,C,C-trisulfonato(5-)-N29,N30,N31,N32]-, trisodium	72229-81-3	Contains (regardless of intentional or impurities)	chemical products
15501	2-Butenoic acid, 4,4'-[[[methylstannylidene]tris(oxo)]tris(4-oxo-, trisooctyl ester	72231-02-8	Contains (regardless of intentional or impurities)	chemical products
15502	Cobalt, 4-amino-5-hydroxy-6-[[2-hydroxy-5-nitro]phenyl]azo]-1,7-naphthalenedisulfonato 2-[[[5-(aminosulfonyl)-2-hydroxy]phenyl]azo]-3-oxo-N-phenylbutanamide sodium complexes	72245-25-1	Intentional addition / 1%	chemical products
15503	Ferrate(2-), bis[2-[[2-hydroxy-5-[[methylamino]sulfonyl]phenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-, dihydrogen	72252-39-2	Intentional addition / 1%	chemical products
15504	Sulfurous acid, monosodium salt, polymer with boric acid (H3BO3), formaldehyde, guanidine monohydrochloride and urea	72252-49-4	Intentional addition / 1%	chemical products
15505	Nickel, [N,N,N'-tris[4-(4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl)phenyl]-29H,31H-phthalocyanine-C,C,C-trisulfonamidato(2-)-N29,N30,N31,N32]-	72252-57-4	Contains (regardless of intentional or impurities)	chemical products
15506	Chromate(4-), [mu-[[[3-[[2-amino-5-hydroxy-6-[[2-hydroxy-5-nitro-3-sulfo]phenyl]azo]-7-sulfo-1-naphthalenyl]azo]-2-hydroxy-5-sulfobenzoato(8-)]]]di-, tetrasodium	72252-58-5	Contains (regardless of intentional or impurities)	chemical products
15507	Cuprate(2-), [5-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-1,3-benzenedisulfonato(4-)]-, disodium	72252-61-0	Intentional addition / 1,000ppm	chemical products
15508	1,2,4-Benzenetricarboxylic acid, manganese(2+) salt (1:1), hexahydrate	72253-08-8	Intentional addition / 1%	chemical products
15509	1,2,4-Benzenetricarboxylic acid, cobalt(2+) salt (2:1), monohydrate	72253-09-9	Intentional addition / 1%	chemical products
15510	1,2,4-Benzenetricarboxylic acid, nickel(2+) salt (2:1), octahydrate	72253-10-2	Intentional addition / 1,000ppm	chemical products
15511	Chromate(1-), [2-[[2-amino-1-naphthalenyl]azo]-5-nitrophenolato(2-)]][8-hydroxy-7-quinolinesulfonato(2-)-N1,O8][2,2'-iminobis[ethanol]-N]-, sodium	72259-07-5	Contains (regardless of intentional or impurities)	chemical products
15512	Chromate(1-), bis[N-(3-[[8-(acetyl)amino]-2-hydroxy-1-naphthalenyl]azo]-2-hydroxy-5-nitrophenyl]acetamidato(2-)]-, sodium	72259-15-5	Contains (regardless of intentional or impurities)	chemical products
15513	Chromate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-methylbenzenesulfonamidato(2-)]-, sodium	72259-16-6	Contains (regardless of intentional or impurities)	chemical products
15514	Boric acid (H3BO3), polymer with formaldehyde, guanidine monohydrochloride and urea	72259-63-3	Intentional addition / 1%	chemical products
15515	Acetic acid, 2,2',2''-(butylstannylidene)tris(thio)tris-, tritetradecl ester	72259-65-5	Contains (regardless of intentional or impurities)	chemical products
15516	Cuprate(6-), [7-[[[6-[[[4-chloro-6-[[3-sulfo]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-sulfo]phenyl]azo]-2,5-dihydroxy-7-sulfo-1-naphthalenyl]azo]-8-hydroxy-1,3,5-naphthalenetrisulfonato(8-)]-, hexasodium	72264-74-5	Intentional addition / 1,000ppm	chemical products
15517	Cobaltate(5-), bis[6-amino-5-[[2-hydroxy-5-[[2-(sulfo)oxyethyl]sulfonyl]phenyl]azo]-1-naphthalenesulfonato(4-)]-, potassium sodium	72269-32-0	Intentional addition / 1,000ppm	chemical products
15518	2,3-Pyrrolidinedione, 1-[2-[[2-[[2-(2-amino)ethyl]amino]ethyl]amino]ethyl]amino]ethyl]-, monopropylisobuteryl derivatives, reaction products with molybdenum oxide (MOO3), sulfurized	72269-41-1	Contains (regardless of intentional or impurities)	chemical products
15519	Chromate(2-), bis[4-[[2-(benzoyloxy)-1-naphthalenyl]azo]-3-hydroxy-1-naphthalenesulfonato(2-)]-, disodium	72269-42-2	Contains (regardless of intentional or impurities)	chemical products
15520	Chromate(1-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, sodium	72275-69-5	Contains (regardless of intentional or impurities)	chemical products
15521	Boric acid (H3BO3), mixed esters with 2-methyl-2,4-pentadiene and pyrocatechol	72275-80-0	Intentional addition / 1%	chemical products
15522	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfonated, sodium salts, reaction products with ethanalamine	72275-81-1	Intentional addition / 1,000ppm	chemical products
15523	Cadmium, dichlorotetrakis(1H-imidazole-N3)-	72275-93-5	Contains (regardless of intentional or impurities)	chemical products
15524	Cuprate(2-), [4-hydroxy-3-[[2-hydroxy-5-[[2-(sulfo)oxyethyl]sulfonyl]phenyl]azo]-1-naphthalenesulfonato(4-)]-, dihydrogen	72275-98-0	Intentional addition / 1,000ppm	chemical products
15525	Dibutyl 3,3'-diacetoxystannylene]dipropionate	72305-84-1	Contains (regardless of intentional or impurities)	chemical products
15526	Boric acid, B-[(1E)-2-(4-methylphenyl)ethenyl]-	72316-17-7	Intentional addition / 1%	chemical products
15527	Boric acid, B-[(1E)-2-(4-methoxyphenyl)ethenyl]-	72316-18-8	Intentional addition / 1%	chemical products
15528	Ferrate(2-), bis[1-[[5-chloro-2-hydroxy]phenyl]azo]-2-naphthalenolato(2-)]-, dihydrogen	72319-11-0	Intentional addition / 1%	chemical products
15529	2,7-Naphthalenedisulfonic acid, nickel(2+) salt (1:1)	72319-19-8	Contains (regardless of intentional or impurities)	chemical products
15530	Copper fluoride (CuF3)	72374-88-0	Intentional addition / 1,000ppm	chemical products
15531	Potassium ferrocyanide dihydrate	72376-32-0	Intentional addition / 1,000ppm	chemical products
15532	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [3-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]-4-sulfo]phenyl]amino]sulfonyl sulfo derivatives, sodium salts	72379-02-3	Intentional addition / 1,000ppm	chemical products
15533	Cuprate(4-), [7-[[[6-[[5-chloro-2,6-difluoro-4-pyrimidinylamino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-8-hydroxy-1,3,5-naphthalenetrisulfonato(6-)]]-, lithium sodium	72379-03-4	Intentional addition / 1,000ppm	chemical products
15534	Naphthene acids, molybdate complexes	72379-29-4	Contains (regardless of intentional or impurities)	chemical products
15535	Mercurate(1-), triiodo-, hydrogen, compound with 3-methyl-2(3H)-benzothiazolimine (1:1)	72379-35-2	Contains (regardless of intentional or impurities)	chemical products
15536	Chromate(3-), bis[4-(acetyl)amino]-5-hydroxy-6-[[2,3,5-trichloro-6-hydroxy]phenyl]azo]-1-naphthalenesulfonato(3-)]-, trihydrogen	72379-38-5	Contains (regardless of intentional or impurities)	chemical products
15537	Chromate(3-), [4-[[4,5-dihydro-4-[[2-hydroxy-5-nitro]phenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]][3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, trihydrogen	72379-39-6	Contains (regardless of intentional or impurities)	chemical products
15538	Direct Green 85	72390-60-4	Intentional addition / 100ppm	chemical products
15539	Cuprate(4-), [2-[[4,5-dihydro-1-[[3-hydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-7-sulfo-1-naphthalenyl]azo]phenyl]-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(6-)]-, trisodium hydrogen	72391-05-0	Intentional addition / 1,000ppm	chemical products
15540	Spiro[isobenzofuran-1(3H),9(8aH)-xanthylum], 3',6'-bis(diethylamino)-3-oxo-, chloride, compound with [4-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)]chromium (1:1)	72391-06-1	Intentional addition / 1,000ppm	chemical products
15541	Cuprate(1-), [4-[[1-[[3-(aminosulfonyl)phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, hydrogen	72391-07-2	Intentional addition / 1,000ppm	chemical products
15542	Cuprate(3-), [mu-[[[4-[[[6-[[5-(aminosulfonyl)-2-hydroxy]phenyl]azo]-1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-2-methyl]phenyl]azo]-7-sulfo-1-naphthalenyl]azo]-1-naphthalenesulfonato(7-)]]]di-, trisodium	72391-08-3	Intentional addition / 1,000ppm	chemical products
15543	Cobaltate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-(1-methylthyl)benzenesulfonamidato(2-)]-, sodium	72391-09-4	Intentional addition / 1,000ppm	chemical products
15544	Cobaltate(1-), [3-[[[6-chloro-2-hydroxy]phenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]][4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-(1-methylthyl)benzenesulfonamidato(2-)]-, sodium	72391-10-7	Intentional addition / 1,000ppm	chemical products
15545	Cuprate(4-), [2-[[4,5-dihydro-1-[[3-hydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-7-sulfo-1-naphthalenyl]azo]phenyl]-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(6-)]-, tetrasodium	72403-30-6	Intentional addition / 1,000ppm	chemical products
15546	Cobaltate(1-), bis[2-[[5-(aminosulfonyl)-2-hydroxy]phenyl]azo]-N-(2-ethylthyl)-3-oxobutanamidato(2-)]-, sodium	72403-31-7	Intentional addition / 1,000ppm	chemical products
15547	Cobaltate(1-), [4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]][4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-(1-methylthyl)benzenesulfonamidato(2-)]-, sodium	72403-32-8	Intentional addition / 1,000ppm	chemical products
15548	Cobaltate(1-), [3-[[[5-chloro-2-hydroxy]phenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]][4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]-, sodium	72403-33-9	Intentional addition / 1,000ppm	chemical products
15549	Cuprate(1-), bis[3-[[4-[[5-chloro-2-hydroxy]phenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, sodium	72403-34-0	Intentional addition / 1,000ppm	chemical products
15550	Cuprate(4-), [[4,4'-[[disulfo-29H,31H-phthalocyaninediyl]bis(sulfonylimino)-3,1-phenyleneazo]]bis[2-hydroxybenzoato]](6-)-N29,N30,N31,N32]-, tetrasodium	72403-38-4	Intentional addition / 1,000ppm	chemical products
15551	Cuprate(4-), [[4,4',4'',4''']-[[29H,31H-phthalocyaninetetrayl]tetrakis(sulfonyloxy)]tetrakis[2-hydroxybenzoato]](6-)-N29,N30,N31,N32]-, tetrasodium	72403-39-5	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15552	Cuprate(1-), [C,C-bis(aminosulfonyl)-C-[[3-[[2,5,6-trichloro-4-pyrimidinyl]amino]phenyl]amino]sulfonyl]-2,9H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, sodium	72403-40-8	Intentional addition / 1,000ppm	chemical products
15553	Benzoic acid, 2-hydroxy-, polymer with formaldehyde and nonylphenol, barium salt	72403-47-5	Contains (regardless of intentional or impurities)	chemical products
15554	Chromate(5-), bis[4-[[6-[[4-chloro-6-(2-ethoxyethoxy)-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, pentasodium	72403-65-7	Contains (regardless of intentional or impurities)	chemical products
15555	Chromate(2-), [N-(2-chlorophenyl)-2-[[2-hydroxy-5-nitrophenyl]azo]-3-oxobutanamidato(2-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, disodium	72403-66-8	Contains (regardless of intentional or impurities)	chemical products
15556	3,4,5-Tribromobiphenyl	72416-87-6	Intentional addition / 1,000ppm	chemical products
15557	Cuprate(4-), [[4,4',4''-[[[sulfo-2,9H,31H-phthalocyaninetriyl]tris(sulfonyloxy)]tris[2-hydroxybenzoato]](6-)-N29,N30,N31,N32]-, tetrasodium	72428-96-7	Intentional addition / 1,000ppm	chemical products
15558	Cuprate(1-), [C-[[2-ethylphenyl]amino]sulfonyl]-C-[[3-methoxypropyl]amino]sulfonyl]-2,9H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen, compound with N,N'-bis(2-methylphenyl)guanidine (1:1)	72428-99-0	Intentional addition / 1,000ppm	chemical products
15559	Chromate(5-), bis[5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfonylphenyl)-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(4-)]-, pentahydrogen	72429-11-9	Contains (regardless of intentional or impurities)	chemical products
15560	Chromate(5-), bis[3-[[5-chloro-2-hydroxyphenyl]azo]-4-hydroxy-5-[[2,5,6-trichloro-4-pyrimidinyl]amino]-2,7-naphthalenedisulfonato(4-)]-, pentasodium	72429-12-0	Contains (regardless of intentional or impurities)	chemical products
15561	Nickelate(6-), [C-[[[3-[[4,5-dihydro-3-methyl-5-oxo-1-[3-sulfo-4-[[2,5,6-trichloro-4-pyrimidinyl]amino]phenyl]ethenyl]phenyl]-1H-pyrazol-4-yl]azo]-4-sulfonyl]amino]sulfonyl]-2,9H,31H-phthalocyanine-C,C,O-trisulfonato(8-)-N29,N30,N31,N32]-, hexasodium	72453-55-5	Contains (regardless of intentional or impurities)	chemical products
15562	Chromate(1-), bis[N-(2-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-5-methylphenyl]acetamidato(2-)]-, sodium	72453-60-2	Contains (regardless of intentional or impurities)	chemical products
15563	Chromate(1-), bis[2-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-[[methylamino]sulfonyl]benzoato(2-)]-, hydrogen	72467-46-0	Contains (regardless of intentional or impurities)	chemical products
15564	3-Chloro-4-dibutylaminobenzenediazonium tetrafluoroborate	72470-82-7	Intentional addition / 1%	chemical products
15565	Chromate(3-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-[4-hydroxy-3-[[[2-hydroxy-5-[[4-(phenylazo)phenyl]azo]phenyl]methylene]amino]benzenesulfonato(3-)]-, trisodium	72479-29-9	Contains (regardless of intentional or impurities)	chemical products
15566	Ferrate(3-), bis[4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, trisodium	72479-30-2	Intentional addition / 1%	chemical products
15567	Chromate(3-), [2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-[4-hydroxy-3-[[[2-hydroxy-5-[[4-(phenylazo)phenyl]azo]phenyl]methylene]amino]benzenesulfonato(3-)]-, trisodium	72479-31-3	Contains (regardless of intentional or impurities)	chemical products
15568	Cuprate(2-), [3-[[2,4-dihydroxy-5-[[4-nitrophenyl]azo]-3-[[4-[[4-nitro-2-sulfonylphenyl]amino]phenyl]azo]phenyl]azo]-4-hydroxy-5-nitrobenzenesulfonato(4-)]-, disodium	72479-32-4	Intentional addition / 1,000ppm	chemical products
15569	Cobaltate(1-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-N-[3-(1-methylethoxypropyl)benzenesulfonamidato(2-)]-, sodium	72479-33-5	Intentional addition / 1,000ppm	chemical products
15570	Iron, [4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-,	72479-34-6	Intentional addition / 1%	chemical products
15571	1,3-Propanediol, 2,2-bis(bromomethyl)-, reaction products with tributoxystilbene	72479-88-0	Contains (regardless of intentional or impurities)	chemical products
15572	Chromate(3-), bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfonylphenyl)-1H-pyrazol-4-yl]azo]benzoato(3-)]-, trihydrogen, compounds with N-butyl-1-butanamine and N-cyclohexylcyclohexanamine	72479-91-5	Contains (regardless of intentional or impurities)	chemical products
15573	Chromate(3-), bis[5-hydroxy-6-[[2-hydroxy-3,5-dinitrophenyl]azo]-1-naphthalenesulfonato(3-)]-, trihydrogen, compounds with N-butyl-1-butanamine and N-cyclohexylcyclohexanamine	72479-92-6	Contains (regardless of intentional or impurities)	chemical products
15574	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonato(3-)]-, trihydrogen, compounds with N-butyl-1-butanamine and N-cyclohexylcyclohexanamine	72479-93-7	Contains (regardless of intentional or impurities)	chemical products
15575	Chromate(3-), bis[5-hydroxy-6-[[2-hydroxyphenyl]azo]-1-naphthalenesulfonato(3-)]-, trihydrogen, nitro derivatives	72479-94-8	Contains (regardless of intentional or impurities)	chemical products
15576	Chromium, 4-hydroxy-3-[[2-hydroxy-3,5-dinitrophenyl]azo]benzenesulfonate 4-hydroxy-3-[[3-hydroxy-4-nitrophenyl]azo]-1-naphthalenesulfonate complexes, compounds with N-butyl-1-butanamine and N-cyclohexylcyclohexanamine	72479-95-9	Intentional addition / 1,000ppm	chemical products
15577	Cobalt, 2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-one 3-hydroxy-7-nitro-4-[[2-(phenylamino)-1-naphthalenyl]azo]-1-naphthalenesulfonate sodium complexes	72479-96-0	Intentional addition / 1%	chemical products
15578	Copper, [2,9H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[5-[[4-chloro-6-[[3-[[1-(4,8-disulfo-2-naphthalenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-sulfonyl]amino]-1,3,5-triazin-2-yl]amino]-2-sulfonyl]amino]sulfonyl sulfo derivatives, sodium salts	72479-97-1	Intentional addition / 1,000ppm	chemical products
15579	Iron, complexes with diazotized 2-amino-4,6-dinitrophenol coupled with diazotized 4-amino-5-hydroxy-1,3-naphthalenedisulfonic acid, diazotized 4-amino-5-hydroxy-2,7-naphthalenedisulfonic acid, diazotized 4-amino-3-methylbenzenesulfonic acid, diazotized 4-nitrobenzenamine and resorcinol, sodium salts	72480-07-0	Intentional addition / 1%	chemical products
15580	Copper, C.I. Natural Yellow 11-diazotized 2-amino-1,4-benzenedisulfonic acid-diazotized 2-[[4-aminophenyl]amino]-5-nitrobenzenesulfonic acid-diazotized 4-nitrobenzenamine coupling products complexes	72480-58-1	Intentional addition / 1,000ppm	chemical products
15581	Copper, C.I. Natural Yellow 11-diazotized 5-amino-1-naphthalenesulfonic acid-diazotized 2-[[4-aminophenyl]amino]-5-nitrobenzenesulfonic acid-diazotized 4-nitrobenzenamine coupling products complexes	72480-60-5	Intentional addition / 1,000ppm	chemical products
15582	Fenoxycarb	72480-01-8	Contains (regardless of intentional or impurities)	chemical products
15583	1-Ethyl-2-[3-[[3-ethyl-3H-benzoselenazol-2-ylidene]prop-1-enyl]quinolinium iodide	72481-44-2	Contains (regardless of intentional or impurities)	chemical products
15584	Ferrate(2-), [3-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-[4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, disodium	72496-86-7	Intentional addition / 1%	chemical products
15585	Ferrate(1-), bis[3-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, sodium	72496-87-8	Intentional addition / 1%	chemical products
15586	Cobaltate(1-), bis[2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-, sodium	72496-88-9	Intentional addition / 1,000ppm	chemical products
15587	Chromium, [2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfonylphenyl)-1H-pyrazol-4-yl]azo]benzoato(3-)]-,	72496-90-3	Contains (regardless of intentional or impurities)	chemical products
15588	2,4-Dichloro-1-(3-chloropropyl)benzene	72506-10-6	Intentional addition / 1,000ppm	chemical products
15589	[N-(2,9H,31H-phthalocyaninylmethyl)pyridine-1-acetamidato(2-)-N29,N30,N31,N32]copper	72506-31-1	Intentional addition / 1,000ppm	chemical products
15590	Chromate(1-), [3-[[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-[4-[[5-chloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen	72509-81-0	Contains (regardless of intentional or impurities)	chemical products
15591	Chromate(5-), bis[5-amino-4-hydroxy-3-[[2-hydroxy-4-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)]-, pentahydrogen	72574-52-8	Contains (regardless of intentional or impurities)	chemical products
15592	Cadmium chloride, dihydrate	72589-96-9	Contains (regardless of intentional or impurities)	chemical products
15593	5-Decene, 5-bromo-, (E)-	72612-74-9	Intentional addition / 1,000ppm	chemical products
15594	5-Decene, 5-bromo-, (Z)-	72612-75-0	Intentional addition / 1,000ppm	chemical products
15595	Lubricating oils, petroleum, C20-50, hydrotreated neutral oil-based, high-viscosity	72623-85-9	Contains (regardless of intentional or impurities)	chemical products
15596	Lubricating oils, petroleum, C15-30, hydrotreated neutral oil-based	72623-86-0	Contains (regardless of intentional or impurities)	chemical products
15597	Lubricating oils, petroleum, C20-50, hydrotreated neutral oil-based	72623-87-1	Contains (regardless of intentional or impurities)	chemical products
15598	Chromium, N-[3-[[8-(acetylamino)-2-hydroxy-1-naphthalenyl]azo]-2-hydroxy-5-nitrophenyl]acetamide N-[7-hydroxy-8-[[2-hydroxy-5-[[methylamino]sulfonyl]phenyl]azo]-1-naphthalenyl]acetamide complexes	72623-96-2	Intentional addition / 1,000ppm	chemical products
15599	Copper, [2,9H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[2-hydroxyethyl]amino]sulfonyl derivatives	72623-97-3	Intentional addition / 1,000ppm	chemical products
15600	Chromate(1-), bis[3-[[1-(2,5-dichlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, sodium	72709-84-3	Contains (regardless of intentional or impurities)	chemical products
15601	Cuprate(2-), [N,N'-bis[[[2-(sulfoxy)ethyl]amino]sulfonyl]phenyl]-2,9H,31H-phthalocyaninedisulfonamidato(4-)-N29,N30,N31,N32]-, potassium sodium	72749-49-6	Intentional addition / 1,000ppm	chemical products
15602	Cuprate(3-), [3-[[4-[[5-[[2,3-dichloro-6-quinoxalyl]carbonyl]methylamino]methyl]-2-sulfonyl]azo]-2-hydroxy-5-methylphenyl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(5-)]-, ammonium diethanamine sodium salts	72749-50-9	Intentional addition / 1,000ppm	chemical products
15603	Cuprate(3-), [N,N,N'-tris[[[2-(sulfoxy)ethyl]amino]sulfonyl]phenyl]-2,9H,31H-phthalocyaninetrisulfonamidato(5-)-N29,N30,N31,N32]-, potassium sodium	72749-51-0	Intentional addition / 1,000ppm	chemical products
15604	Cuprate(4-), [7-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-3-[[4-[[2,5-disulfonylphenyl]azo]-2-hydroxy-5-methylphenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)]-, potassium sodium	72749-52-1	Intentional addition / 1,000ppm	chemical products
15605	Cuprate(4-), [N,N,N,N'-tetakis[[[2-(sulfoxy)ethyl]amino]sulfonyl]phenyl]-2,9H,31H-phthalocyaninetetrasulfonamidato(6-)-N29,N30,N31,N32]-, potassium sodium	72749-53-2	Intentional addition / 1,000ppm	chemical products
15606	Chromate(5-), bis[6-amino-4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfonylphenyl]azo]-2-naphthalenesulfonato(4-)]-, pentasodium	72765-46-9	Contains (regardless of intentional or impurities)	chemical products
15607	Chromate(7-), bis[4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfonylphenyl]azo]-6-[[3-sulfonyl]amino]-2-naphthalenesulfonato(5-)]-, heptasodium	72765-47-0	Contains (regardless of intentional or impurities)	chemical products
15608	1,4-Benzenedisulfonic acid, 2-[[2-hydroxy-1-naphthalenyl]azo]-, barium salt (1:1)	72765-60-7	Contains (regardless of intentional or impurities)	chemical products
15609	Benzenesulfonic acid, 2-[[2-hydroxy-1-naphthalenyl]azo]-, barium salt (2:1)	72765-61-8	Contains (regardless of intentional or impurities)	chemical products
15610	Ferrate(5-), bis[4-[[2,4-dihydroxy-5-[[2-methoxyphenyl]azo]-3-[[4-(phenylamino)-3-sulfonyl]azo]phenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, pentahydrogen	72779-11-4	Intentional addition / 1%	chemical products
15611	Chromate(5-), bis[3-hydroxy-4-[[2-hydroxy-8-sulfo-1-naphthalenyl]azo]-1-naphthalenesulfonato(4-)]-, pentahydrogen	72796-98-6	Contains (regardless of intentional or impurities)	chemical products
15612	Chromate(3-), bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, trihydrogen	72796-99-7	Contains (regardless of intentional or impurities)	chemical products
15613	Chromate(5-), bis[3-hydroxy-4-[[1-hydroxy-8-sulfo-2-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(4-)]-, pentahydrogen	72797-00-3	Contains (regardless of intentional or impurities)	chemical products
15614	Chromate(3-), bis[5-[[5-chloro-2-hydroxyphenyl]azo]-6-hydroxy-2-naphthalenesulfonato(3-)]-, trihydrogen, compound with 2,2-iminobis[ethanol] (1:3)	72797-01-4	Contains (regardless of intentional or impurities)	chemical products
15615	Chromate(3-), bis[4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, trisodium	72797-02-5	Contains (regardless of intentional or impurities)	chemical products
15616	Chromate(1-), bis[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen	72797-03-6	Contains (regardless of intentional or impurities)	chemical products
15617	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, dihydrogen	72797-04-7	Contains (regardless of intentional or impurities)	chemical products
15618	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, dihydrogen, compound with 2,2-iminobis[ethanol] (1:2)	72797-05-8	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15619	Chromate(1-), bis[4-[[5-(2,2-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen	72797-06-9	Contains (regardless of intentional or impurities)	chemical products
15620	Chromate(1-), bis[4-[[5-(2,2-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 3-[(2-ethylhexyloxy)-1-propanamine (1:1)]	72797-07-0	Contains (regardless of intentional or impurities)	chemical products
15621	Cobaltate(3-), bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-, trihydrogen	72797-08-1	Intentional addition / 1,000ppm	chemical products
15622	Cobaltate(3-), bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-, trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72797-09-2	Intentional addition / 1,000ppm	chemical products
15623	Chromate(2-), [4-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, dihydrogen	72797-10-5	Contains (regardless of intentional or impurities)	chemical products
15624	Chromate(2-), [4-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72797-11-6	Contains (regardless of intentional or impurities)	chemical products
15625	Chromate(5-), bis[7-amino-4-hydroxy-3-[(2-hydroxy-5-nitro-3-sulfonyl)azo]-2-naphthalenesulfonato(4-)]-, pentahydrogen	72797-12-7	Contains (regardless of intentional or impurities)	chemical products
15626	Chromate(5-), bis[7-amino-4-hydroxy-3-[(2-hydroxy-5-nitro-3-sulfonyl)azo]-2-naphthalenesulfonato(4-)]-, pentahydrogen, compound with 2,2'-iminobis[ethanol] (1:5)	72797-13-8	Contains (regardless of intentional or impurities)	chemical products
15627	Cobaltate(1-), bis[2-[(2-hydroxy-5-nitrophenyl)azo]-3-oxo-N-phenylbutanamidato(2-)]-, hydrogen, compound with 1-butamine (1:1)	72797-14-9	Intentional addition / 1,000ppm	chemical products
15628	Chromate(3-), bis[2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-sulfobenzoato(3-)]-, trihydrogen	72812-20-5	Contains (regardless of intentional or impurities)	chemical products
15629	Chromate(5-), bis[8-[(5-chloro-2-hydroxyphenyl)azo]-7-hydroxy-1,3-naphthalenedisulfonato(4-)]-, pentahydrogen	72812-21-6	Contains (regardless of intentional or impurities)	chemical products
15630	Chromate(5-), bis[4-[(6-amino-1-hydroxy-3-sulfo-2-naphthalenyl)azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, pentahydrogen	72812-22-7	Contains (regardless of intentional or impurities)	chemical products
15631	Chromate(5-), bis[4-[(6-amino-1-hydroxy-3-sulfo-2-naphthalenyl)azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, pentahydrogen, compound with 2,2'-iminobis[ethanol] (1:5)	72812-23-8	Contains (regardless of intentional or impurities)	chemical products
15632	Chromate(3-), bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-, trihydrogen, compound with NN-bis(2-methylphenyl)guanidine (1:3)	72812-24-9	Contains (regardless of intentional or impurities)	chemical products
15633	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, dihydrogen	72812-25-0	Contains (regardless of intentional or impurities)	chemical products
15634	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72812-26-1	Contains (regardless of intentional or impurities)	chemical products
15635	Chromate(2-), [4-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-[2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen	72812-27-2	Contains (regardless of intentional or impurities)	chemical products
15636	Chromate(2-), [4-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-[2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72812-28-3	Contains (regardless of intentional or impurities)	chemical products
15637	Chromate(1-), [2,4-dihydro-4-[(2-hydroxy-5-methyl-3-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[4-[[5-(2,2-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen	72812-29-4	Contains (regardless of intentional or impurities)	chemical products
15638	Chromate(1-), [4-[[5-(2,2-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[4-[(2-hydroxy-3-nitro-5-methylphenyl)azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 3-[(2-ethylhexyloxy)-1-propanamine (1:1)]	72812-30-7	Contains (regardless of intentional or impurities)	chemical products
15639	Chromate(1-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-[(4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(2-)]-, hydrogen	72812-31-8	Contains (regardless of intentional or impurities)	chemical products
15640	Chromate(1-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-[(4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(2-)]-, hydrogen, compound with 3-[(2-ethylhexyloxy)-1-propanamine (1:1)]	72812-32-9	Contains (regardless of intentional or impurities)	chemical products
15641	Chromate(3-), bis[5-chloro-3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxybenzenesulfonato(3-)]-, trihydrogen, compound with NN-bis(2-methylphenyl)guanidine (1:3)	72812-33-0	Contains (regardless of intentional or impurities)	chemical products
15642	Chromate(1-), [1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, hydrogen, compound with 3-[(2-ethylhexyloxy)-1-propanamine (1:1)]	72812-34-1	Contains (regardless of intentional or impurities)	chemical products
15643	Chromate(1-), bis[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, hydrogen, compound with 3-[(2-ethylhexyloxy)-1-propanamine (1:1)]	72812-35-2	Contains (regardless of intentional or impurities)	chemical products
15644	Chromate(1-), bis[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, hydrogen, compound with 3-[(2-ethylhexyloxy)-1-propanamine (1:1)]	72812-36-3	Contains (regardless of intentional or impurities)	chemical products
15645	Chromate(2-), [4-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, hydrogen	72812-37-4	Contains (regardless of intentional or impurities)	chemical products
15646	Chromate(3-), bis[5-chloro-2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)]-, trihydrogen	72812-38-5	Contains (regardless of intentional or impurities)	chemical products
15647	Nickel(1+), [dimethyl 5-acetyl-5'-[1-[5-bromo[4-(2-methoxy-2-oxoethyl)-3-(3-methoxy-3-oxopropyl)-4-methyl-5-oxo-2-pyrroldinylidene]methyl]-3,4-dihydro-3-(3-methoxy-3-oxopropyl)-4-methyl-2H-pyrrol-2-ylidene]ethyl]-3,3'-bis(2-methoxy-2-oxoethyl)-2,3,4-trimethyl[2,2'-bi-2H-pyrrole]-4,4'-dipropionato-N(1,N5,N5')-, stereoisomer, acetate	72813-81-1	Contains (regardless of intentional or impurities)	chemical products
15648	C.I. Acid Black 209	72827-68-0	Intentional addition / 1,000ppm	chemical products
15649	C.I. Pigment Yellow 62:1	72828-92-5	Intentional addition / 1,000ppm	chemical products
15650	Benzene, diethenyl-, polymer with ethenylbenzene, sulfonated, copper salts	72828-16-1	Intentional addition / 1,000ppm	chemical products
15651	Benzene, diethenyl-, polymer with ethenylbenzene, sulfonated, iron salts	72828-17-2	Intentional addition / 1%	chemical products
15652	Benzene, diethenyl-, polymer with ethenylbenzene, sulfonated, manganese salts	72828-18-3	Contains (regardless of intentional or impurities)	chemical products
15653	Benzene, diethenyl-, polymer with ethenylbenzene, sulfonated, molybdenum salts	72828-19-4	Contains (regardless of intentional or impurities)	chemical products
15654	Chromium, 3,3'-[sulfonylbis(6-hydroxy-3,1-phenylenebis(azo))]bis(4-hydroxy-6-[[4-sulfonothioylphenyl]amino]-2-naphthalenesulfonate) cobalt sodium complexes	72828-26-3	Intentional addition / 1,000ppm	chemical products
15655	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfo [[6-sulfo-9-[[2-(sulfoxy)ethyl]sulfonyl]-2-naphthalenyl]amino]sulfonyl derivatives	72828-27-4	Intentional addition / 1,000ppm	chemical products
15656	Cuprate(3-), [4-amino-6-[[5-[[2,3-dichloro-6-quinoxalyl]carbonyl]amino]-2-hydroxy-4-sulfonyl]azo]-5-hydroxy-1,3-naphthalenedisulfonato(5-)]-, potassium sodium	72828-28-5	Intentional addition / 1,000ppm	chemical products
15657	3-Cyclohexene-1-methanol, alpha, alpha, 4-trimethyl-, mixed with alpha-pinene and beta-pinene, sulfurized, reaction products with platinum chloride (PtCl4)	72828-30-9	Contains (regardless of intentional or impurities)	chemical products
15658	3-Cyclohexene-1-methanol, alpha, alpha, 4-trimethyl-, mixed with alpha-pinene and beta-pinene, sulfurized, reaction products with rhodium chloride (RhCl3)	72828-33-2	Contains (regardless of intentional or impurities)	chemical products
15659	Glycine, N-(C12-22-alkylsulfonyl) derivatives, barium salts (2:1)	72828-36-5	Intentional addition / 1,000ppm	chemical products
15660	Glycine, N-[(chlorinated C12-22-alkylsulfonyl) derivatives, barium salts (2:1)	72828-41-2	Intentional addition / 1,000ppm	chemical products
15661	Glycine, N-[(chlorinated naphthylsulfonyl) derivatives, barium salts (2:1)	72828-46-7	Intentional addition / 1,000ppm	chemical products
15662	Glycine, N-(naphthylsulfonyl) derivatives, barium salts (2:1)	72828-49-0	Intentional addition / 1,000ppm	chemical products
15663	Iron, complexes with diazotized 2-amino-4,6-dinitrophenol coupled with diazotized 2-[(4-aminophenyl)amino]-5-nitrobenzenesulfonic monosodium salt and 3-[(2,4-dihydroxyphenyl)azo]-4-hydroxybenzenesulfonato(3-)]-, monosodium salt	72828-51-4	Intentional addition / 1%	chemical products
15664	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-[[1,3-dioxobutyl]amino]phenyl]amino]sulfonyl derivatives	72828-53-6	Contains (regardless of intentional or impurities)	chemical products
15665	Phosphoric acid, reaction products with borax, sodium salts	72828-55-8	Intentional addition / 1%	chemical products
15666	Zircon, cadmium red	72828-62-7	Contains (regardless of intentional or impurities)	chemical products
15667	Chromate(3-), bis[5-chloro-3-[[1,5-dihydroxy-2-naphthalenyl]azo]-2-hydroxybenzenesulfonato(3-)]-, trihydrogen	72829-08-4	Contains (regardless of intentional or impurities)	chemical products
15668	Chromate(4-), [5-chloro-2-hydroxy-3-[[[2-hydroxy-5-[[4-sulfonyl]azo]phenyl]methylene]amino]benzenesulfonato(4-)]-3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-1-naphthalenesulfonato(3-)]-, tetrasodium	72829-32-4	Contains (regardless of intentional or impurities)	chemical products
15669	Cobaltate(3-), bis[2-[[[4-hydroxy-3-[[2-(phenylamino)-1-naphthalenyl]azo]phenyl]sulfonyl]amino]benzoato(3-)]-, sodium dihydrogen	72829-33-5	Intentional addition / 1,000ppm	chemical products
15670	Chromate(1-), [4-hydroxy-5-[[1,2,3,4-tetrahydro-2,4-dioxo-3-quinolinyl]azo]-1,3-benzenedisulfonato(4-)]-, hydrogen	72829-34-6	Contains (regardless of intentional or impurities)	chemical products
15671	Cuprate(3-), [4-amino-6-[[6-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-hydroxy-4-sulfo-1-naphthalenyl]azo]-5-hydroxy-1,3-naphthalenedisulfonato(5-)]-, tripotassium	72829-35-7	Intentional addition / 1,000ppm	chemical products
15672	Arsenous acid, lithium salt	72845-34-2	Contains (regardless of intentional or impurities)	chemical products
15673	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-1-phenyl-3H-pyrazol-3-onato(2-)]-[3-[(2,4-dihydroxyphenyl)azo]-4-hydroxybenzenesulfonato(3-)]-, dihydrogen	72845-51-3	Contains (regardless of intentional or impurities)	chemical products
15674	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-[(2,4-dihydroxyphenyl)azo]-4-hydroxybenzenesulfonato(3-)]-, dihydrogen	72845-52-4	Contains (regardless of intentional or impurities)	chemical products
15675	Chromate(2-), [3-[[2,4-diaminophenyl]azo]-4-hydroxybenzenesulfonato(3-)]-[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-, dihydrogen	72845-53-5	Contains (regardless of intentional or impurities)	chemical products
15676	Chromate(2-), [3-[[2,4-diaminophenyl]azo]-4-hydroxybenzenesulfonato(3-)]-[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen	72845-54-6	Contains (regardless of intentional or impurities)	chemical products
15677	Chromate(2-), [3-[[2,4-diaminophenyl]azo]-4-hydroxybenzenesulfonato(3-)]-[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, dihydrogen	72845-55-7	Contains (regardless of intentional or impurities)	chemical products
15678	Chromate(2-), [3-[[2,4-diaminophenyl]azo]-4-hydroxybenzenesulfonato(3-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, dihydrogen	72845-56-8	Contains (regardless of intentional or impurities)	chemical products
15679	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)]-, dihydrogen	72845-57-9	Contains (regardless of intentional or impurities)	chemical products
15680	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)]-, dihydrogen	72845-58-0	Contains (regardless of intentional or impurities)	chemical products
15681	Chromate(1-), [3-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, hydrogen	72845-59-1	Contains (regardless of intentional or impurities)	chemical products
15682	Chromate(1-), [2-[1-[3-(aminosulfonyl)phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, hydrogen	72845-60-4	Contains (regardless of intentional or impurities)	chemical products
15683	Chromate(3-), bis[3-hydroxy-7-nitro-4-[[2-oxo-1-[(phenylamino)carbonyl]propyl]azo]-1-naphthalenesulfonato(3-)]-, trihydrogen	72845-61-5	Contains (regardless of intentional or impurities)	chemical products
15684	Chromate(3-), bis[4-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(3-)]-, trihydrogen	72845-62-6	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15685	Chromate(2-), [5-[(5-chloro-2-hydroxyphenyl)azo]-4,6-dihydroxy-2-naphthalenesulfonato(3-)]-1-[(2-hydroxy-5-nitrophenylazo)-2-naphthalenolato(2-)]-, dihydrogen	72845-64-8	Contains (regardless of intentional or impurities)	chemical products
15686	Chromate(2-), [5-[(5-chloro-2-hydroxyphenyl)azo]-4,6-dihydroxy-2-naphthalenesulfonato(3-)]-1-[(2-hydroxy-4-nitrophenylazo)-2-naphthalenolato(2-)]-, dihydrogen	72845-65-9	Contains (regardless of intentional or impurities)	chemical products
15687	Chromate(2-), [5-chloro-2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)]-1-[(2-hydroxy-5-nitrophenylazo)-2-naphthalenolato(2-)]-, dihydrogen	72845-66-0	Contains (regardless of intentional or impurities)	chemical products
15688	Chromate(2-), [5-chloro-2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)]-1-[(2-hydroxy-4-nitrophenylazo)-2-naphthalenolato(2-)]-, dihydrogen	72845-67-1	Contains (regardless of intentional or impurities)	chemical products
15689	Chromate(2-), [4-[(5-chloro-2-hydroxyphenyl)azo]-2,4-dihydroxy-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-5-[(5-chloro-2-hydroxyphenyl)azo]-6-hydroxy-2-naphthalenesulfonato(3-)]-, dihydrogen	72845-68-2	Contains (regardless of intentional or impurities)	chemical products
15690	Chromate(2-), [5-[(5-chloro-2-hydroxyphenyl)azo]-6-hydroxy-2-naphthalenesulfonato(3-)]-1-[(2-hydroxy-5-nitrophenylazo)-2-naphthalenolato(2-)]-, dihydrogen	72845-69-3	Contains (regardless of intentional or impurities)	chemical products
15691	Chromate(2-), [5-[(5-chloro-2-hydroxyphenyl)azo]-6-hydroxy-2-naphthalenesulfonato(3-)]-1-[(2-hydroxy-4-nitrophenylazo)-2-naphthalenolato(2-)]-, dihydrogen	72845-70-6	Contains (regardless of intentional or impurities)	chemical products
15692	Chromate(1-), bis[3-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, hydrogen	72845-72-8	Contains (regardless of intentional or impurities)	chemical products
15693	Chromate(1-), [3-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen	72845-73-9	Contains (regardless of intentional or impurities)	chemical products
15694	Chromate(1-), [3-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen	72845-74-0	Contains (regardless of intentional or impurities)	chemical products
15695	Chromate(1-), [3-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-3-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, hydrogen	72845-75-1	Contains (regardless of intentional or impurities)	chemical products
15696	Cobaltate(1-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonamidato(2-)]-, dihydrogen	72845-76-2	Intentional addition / 1,000ppm	chemical products
15697	1-Benzopyrylium, 4-[6-methoxy-2-[2-(4-methoxyphenyl)ethenyl]-3-phenyl-4H-1-benzopyran-4-yl]-2-phenyl-perchlorate	72846-02-7	Intentional addition / 1,000ppm	chemical products
15698	Chromate(5-), bis[2-[6-[(4-chloro-6-[(3-sulfophenyl)amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(4-)]-, pentasodium	72846-03-8	Contains (regardless of intentional or impurities)	chemical products
15699	Chromate(5-), bis[2-[6-[(4-chloro-6-[(4-sulfophenyl)amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(4-)]-, pentasodium	72846-04-9	Contains (regardless of intentional or impurities)	chemical products
15700	Zirconium naphthenate	72854-21-8	Contains (regardless of intentional or impurities)	chemical products
15701	Chromate(1-), bis[2-[1-[3-(aminosulfonyl)phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-, hydrogen	72854-28-5	Contains (regardless of intentional or impurities)	chemical products
15702	Chromate(1-), [2-[1-[3-(aminosulfonyl)phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-2-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-1-yl]azo]benzoato(2-)]-, hydrogen	72854-29-6	Contains (regardless of intentional or impurities)	chemical products
15703	Chromate(2-), [2-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-2-[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfonyl)phenyl-1H-pyrazol-4-yl]azo]benzoato(3-)]-, dihydrogen	72854-30-9	Contains (regardless of intentional or impurities)	chemical products
15704	Chromate(1-), bis[3-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(2-)]-, hydrogen	72854-31-0	Contains (regardless of intentional or impurities)	chemical products
15705	Chromate(1-), [2-[1-[3-(aminosulfonyl)phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-2-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen	72854-32-1	Contains (regardless of intentional or impurities)	chemical products
15706	Cuprate(2-), [5-[[5-chloro-6-methyl-2-(methylsulfonyl)-4-pyrimidinyl]amino]-4-hydroxy-3-[(2-hydroxyphenyl)azo]-2,7-naphthalenedisulfonato(4-)]-, disodium	72854-33-2	Intentional addition / 1,000ppm	chemical products
15707	Chromate(2-), [4-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen	72854-34-3	Contains (regardless of intentional or impurities)	chemical products
15708	Chromate(1-), [2-[1-[3-(aminosulfonyl)phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-3-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, hydrogen	72854-35-4	Contains (regardless of intentional or impurities)	chemical products
15709	Copper, [2,3,10,16,17,24-hexabromo-1,8,9,15,22,23-hexachloro-29H,31H-phthalocyaninato(2-)]-N29,N30,N31,N32]-, (SP-4-1)-	72854-36-5	Intentional addition / 1,000ppm	chemical products
15710	Cuprate(2-), [4-[[2-[(2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-1,3-dioxobutyl]amino]benzenesulfonato(4-)]-, dihydrogen	72854-39-8	Intentional addition / 1,000ppm	chemical products
15711	Cuprate(3-), [3-hydroxy-4-[[2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(5-)]-, trisodium	72854-40-1	Intentional addition / 1,000ppm	chemical products
15712	3-Decene, 1-bromo-, (Z)-	72855-89-1	Intentional addition / 1,000ppm	chemical products
15713	Cadmium zinc sulfide ((Cd,Zn)S), cobalt and copper-doped	72869-26-2	Contains (regardless of intentional or impurities)	chemical products
15714	Chromium, N-[2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,12,12,12-docosafluoro-1-oxo-11-(trifluoromethyl)dodecyl]glycine N-[2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10,10-octadecafluoro-1-oxo-9-(trifluoromethyl)decyl]glycine N-[2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-tetraecafluoro-1-oxo-7-(trifluoromethyl)octyl]glycine complexes	72869-27-3	Intentional addition / 1,000ppm	chemical products
15715	Copper, [29H,31H-phthalocyaninato(2-)]-N29,N30,N31,N32]-, chloro sulfo derivatives, sodium salts	72869-28-4	Intentional addition / 1,000ppm	chemical products
15716	Ethanedioic acid, rare earth salts	72869-29-5	Intentional addition / 1,000ppm	chemical products
15717	Zinc sulfide (ZnS), cobalt and copper-doped	72869-37-5	Intentional addition / 1,000ppm	chemical products
15718	Amines, coco alkyl, ethoxylated, compounds with hydrogen [2-[[1-[3-(aminosulfonyl)phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-2-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)(1:1)	72869-40-0	Contains (regardless of intentional or impurities)	chemical products
15719	Amines, coco alkyl, ethoxylated, compounds with hydrogen bis[2-[[1-[3-(aminosulfonyl)phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)(1:1)	72869-41-1	Contains (regardless of intentional or impurities)	chemical products
15720	Amines, coco alkyl, ethoxylated, compounds with hydrogen bis[1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphthalenolato(2-)]chromate(1-)(1:1)	72869-42-2	Contains (regardless of intentional or impurities)	chemical products
15721	Amines, coco alkyl, ethoxylated, compounds with hydrogen bis[2,4-dihydro-4-[(2-hydroxy-5-methyl-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)(1:1)	72869-43-3	Contains (regardless of intentional or impurities)	chemical products
15722	Amines, coco alkyl, ethoxylated, compounds with hydrogen bis[2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)(1:1)	72869-44-4	Contains (regardless of intentional or impurities)	chemical products
15723	Amines, coco alkyl, ethoxylated, compounds with hydrogen bis[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)(1:1)	72869-45-5	Contains (regardless of intentional or impurities)	chemical products
15724	Amines, coco alkyl, ethoxylated, compounds with hydrogen bis[2-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]chromate(1-)(1:1)	72869-46-6	Contains (regardless of intentional or impurities)	chemical products
15725	Amines, coco alkyl, ethoxylated, compounds with hydrogen bis[3-[4-[[5-(2,2-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]chromate(1-)(1:1)	72869-47-7	Contains (regardless of intentional or impurities)	chemical products
15726	Amines, coco alkyl, ethoxylated, compounds with hydrogen bis[1-[(2-hydroxy-5-methyl-3-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)(1:1)	72869-48-8	Contains (regardless of intentional or impurities)	chemical products
15727	Amines, coco alkyl, ethoxylated, compounds with hydrogen bis[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)(1:1)	72869-49-9	Contains (regardless of intentional or impurities)	chemical products
15728	Amines, coco alkyl, ethoxylated, compounds with hydrogen bis[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)(1:1)	72869-50-2	Contains (regardless of intentional or impurities)	chemical products
15729	Amines, coco alkyl, ethoxylated, compounds with hydrogen [1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphthalenolato(2-)]-2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)(1:1)	72869-51-3	Contains (regardless of intentional or impurities)	chemical products
15730	Amines, coco alkyl, ethoxylated, compounds with hydrogen [1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphthalenolato(2-)]-2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)(1:1)	72869-52-4	Contains (regardless of intentional or impurities)	chemical products
15731	Amines, coco alkyl, ethoxylated, compounds with hydrogen [2,4-dihydro-4-[(2-hydroxy-5-methyl-3-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-3-[4-[[5-(2,2-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]chromate(1-)(1:1)	72869-53-5	Contains (regardless of intentional or impurities)	chemical products
15732	Amines, coco alkyl, ethoxylated, compounds with hydrogen [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-2-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)(1:1)	72869-54-6	Contains (regardless of intentional or impurities)	chemical products
15733	Amines, coco alkyl, ethoxylated, compounds with hydrogen [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-2-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)(1:1)	72869-55-7	Contains (regardless of intentional or impurities)	chemical products
15734	Amines, coco alkyl, ethoxylated, compounds with hydrogen [1-[(2-hydroxy-5-methyl-3-nitrophenyl)azo]-2-naphthalenolato(2-)]-1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)(1:1)	72869-56-8	Contains (regardless of intentional or impurities)	chemical products
15735	Amines, coco alkyl, ethoxylated, compounds with hydrogen [1-[(2-hydroxy-5-methyl-3-nitrophenyl)azo]-2-naphthalenolato(2-)]-1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)(1:1)	72869-57-9	Contains (regardless of intentional or impurities)	chemical products
15736	Amines, coco alkyl, ethoxylated, compounds with hydrogen [1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)(1:1)	72869-58-0	Contains (regardless of intentional or impurities)	chemical products
15737	Amines, coco alkyl, ethoxylated, compounds with trihydrogen bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]chromate(3-)(3:1)	72869-59-1	Contains (regardless of intentional or impurities)	chemical products
15738	Amines, coco alkyl, ethoxylated, compounds with trihydrogen bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]chromate(3-)(3:1)	72869-60-4	Contains (regardless of intentional or impurities)	chemical products
15739	Amines, rosin, bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]chromate(3-)(3:1)	72869-61-5	Contains (regardless of intentional or impurities)	chemical products
15740	Fatty acids, coco, cadmium salts	72869-63-7	Contains (regardless of intentional or impurities)	chemical products
15741	Cuprate(8-), [mu-[[3,3-(carbonyldiimino)bis[7-[(2,8-dihydroxy-3,6-disulfo-1-naphthalenyl)azo]-8-hydroxy-1,5-naphthalenedisulfonato]](1,2-)]di-oxo]dissulfate	72869-84-2	Intentional addition / 1,000ppm	chemical products
15742	Chromate(1-), bis[3,5-bis(1,1-dimethylethyl)-2-hydroxybenzoato(2-)]O1,O2]-, hydrogen, (T-4)-	72869-85-3	Contains (regardless of intentional or impurities)	chemical products
15743	Barium chloride, hydrate	72885-34-8	Intentional addition / 1,000ppm	chemical products
15744	Cuprate(2-), [C-(aminosulfonyl)-29H,31H-phthalocyanine-C,C-disulfonato(4-)]-N29,N30,N31,N32]-, disodium	72894-04-3	Intentional addition / 1,000ppm	chemical products
15745	[alpha, alpha-(Ethylbenzidimino)bis[2-hydroxy-4-methylbenzenoacetato]](2-)]iron	72901-53-2	Intentional addition / 1%	chemical products
15746	Cobaltate(1-), bis[3-[(8-hydroxy-5-quinolino)azo]benzenesulfonato(2-)]-, sodium	72905-57-8	Intentional addition / 1,000ppm	chemical products
15747	Octadecanoic acid, 2,3-dihydroxypropyl ester, ester with boric acid(H3BO3)	72905-86-3	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15748	Chromium, 4-hydroxy-3-[[2-hydroxy-8-[[methylsulfonyl]amino]-1-naphthalenyl]azo]benzenesulfonamide 4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamide sodium complexes	72905-92-1	Intentional addition / 1,000ppm	chemical products
15749	Cuprate(2-), [mu-[[7.7'-iminobis[4-hydroxy-3-[[2-hydroxy-5-[[methylamino]sulfonyl]phenyl]azo]-2-naphthalenesulfonato]](6-)]di-, ammonium sodium	72905-93-2	Intentional addition / 1,000ppm	chemical products
15750	Cuprate(2-), [29H.31H-phthalocyanine]disulfonato(4-)-N29.N30.N31.N32]-, potassium, compounds with polyethylene glycol ether with triethanolamine (3.1)	72905-94-3	Intentional addition / 1,000ppm	chemical products
15751	Cuprate(3-), [mu-[[5-(acetyl)amino]-3-[[4-(1.8-dihydroxy-5-sulfo-2-naphthalenyl)azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(7-)]di-, ammonium sodium, compounds with ethanolanine	72905-95-4	Intentional addition / 1,000ppm	chemical products
15752	Cuprate(4-), [mu-[[4.4'-azobis[[2-hydroxy-4.1-phenylene]azo(8-hydroxy-6-sulfo-7,2-naphthalenediyl)imino]bis]benzoato]](8-)]di-, ammonium sodium	72905-96-5	Intentional addition / 1,000ppm	chemical products
15753	Cuprate(4-), [mu-[[3.3'-azobis[[2-hydroxy-4.1-phenylene]azo]]bis[[4-hydroxy-6-[[3-sulfo]phenyl]amino]-2-naphthalenesulfonato]](8-)]di-, ammonium sodium	72905-97-6	Intentional addition / 1,000ppm	chemical products
15754	Cuprate(4-), [mu-[[4.4'-azobis[[2-hydroxy-4.1-phenylene]azo(8-hydroxy-6-sulfo-7,2-naphthalenediyl)imino]bis]benzoato]](8-)]di-, ammonium sodium	72905-98-7	Intentional addition / 1,000ppm	chemical products
15755	Cuprate(4-), [mu-[[3.3'-azobis[[2-hydroxy-4.1-phenylene]azo]]bis[[4-hydroxy-6-[[3-sulfo]phenyl]amino]-2-naphthalenesulfonato]](8-)]di-, ammonium sodium	72905-99-8	Intentional addition / 1,000ppm	chemical products
15756	Cuprate(4-), [mu-[[5,5'-carbonylbis[imino(2-hydroxy-5-sulfo-4,1-phenylene)azo]]bis[6-hydroxy-2-naphthalenesulfonato]](8-)]di-, ammonium sodium	72906-00-4	Intentional addition / 1,000ppm	chemical products
15757	Cuprate(4-), [mu-[[3.3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis]azo]]bis[6-ethoxy-4-hydroxy-2,7-naphthalenedisulfonato]](8-)]di-, ammonium sodium	72906-01-5	Intentional addition / 1,000ppm	chemical products
15758	Zinc sulfide (ZnS), cobalt and silver-doped	72906-12-8	Intentional addition / 1%	chemical products
15759	Chromate(1-), bis[4-hydroxy-3-[[2-methyl-4H-pyrazolo[1,5-a]benzimidazol-3-yl]azo]benzenesulfonamidato(2-)]-, sodium	72906-13-9	Contains (regardless of intentional or impurities)	chemical products
15760	Ferrate(1-), [3-[[2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonato(3-)]-, sodium	72906-14-0	Intentional addition / 1%	chemical products
15761	Cuprate(1-), [3-[[[3-amino-4-nitrophenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonato(3-)]-, sodium	72906-19-5	Intentional addition / 1,000ppm	chemical products
15762	Molybdenum oxide phosphate (Mo2O057)(PO4)2	72906-43-5	Contains (regardless of intentional or impurities)	chemical products
15763	Chromate(3-), bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, trihydrogen, compound with 4,4'-carbonyldiylbis[N,N-dimethylbenzenamine] (1.3)	72906-58-2	Contains (regardless of intentional or impurities)	chemical products
15764	Chromate(2-), [4-[[4,5-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-4-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]][1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1.2)	72906-60-6	Contains (regardless of intentional or impurities)	chemical products
15765	Cuprate(3-), [mu-[[4-[[3,3'-dihydroxy-4-[[2-hydroxy-6-sulfo-1-naphthalenyl]azo]]1,1'-biphenyl]-4-yl]azo]-3-hydroxy-2,7-naphthalenedisulfonato(7-)]di-, triammonium	72906-61-7	Intentional addition / 1,000ppm	chemical products
15766	Cuprate(3-), [mu-[[4-[[3,3'-dihydroxy-4-[[2-hydroxy-6-sulfo-1-naphthalenyl]azo]]1,1'-biphenyl]-4-yl]azo]-3-hydroxy-2,7-naphthalenedisulfonato(7-)]di-, trisodium	72906-62-8	Intentional addition / 1,000ppm	chemical products
15767	Cuprate(3-), [mu-[[4-[[3,3'-dihydroxy-4-[[2-hydroxy-6-sulfo-1-naphthalenyl]azo]]1,1'-biphenyl]-4-yl]azo]-3-hydroxy-2,7-naphthalenedisulfonato(7-)]di-, triethyl	72906-63-9	Intentional addition / 1,000ppm	chemical products
15768	Cuprate(3-), [mu-[[4-[[3,3'-dihydroxy-4-[[2-hydroxy-6-sulfo-1-naphthalenyl]azo]]1,1'-biphenyl]-4-yl]azo]-3-hydroxy-2,7-naphthalenedisulfonato(7-)]di-, trihydrogen, compound with 2,2'-iminobis[ethanol] (1.3)	72906-64-0	Intentional addition / 1,000ppm	chemical products
15769	Cuprate(4-), [5-[[4-chloro-6-[[2-methyl-4-sulfo]phenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-4-sulfo-1-naphthalenyl]azo]-2,7-naphthalenedisulfonato(6-)]-, tetrasodium	72906-65-1	Intentional addition / 1,000ppm	chemical products
15770	Copper(2+) isononanoate	72915-82-3	Intentional addition / 1,000ppm	chemical products
15771	1,2,3,7,8,9-Hexachlorodibenzofuran	72918-21-9	Contains (regardless of intentional or impurities)	chemical products
15772	Cuprate(4-), [mu-[[7-[[3,3'-dihydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]]1,1'-biphenyl]-4-yl]azo]-8-hydroxy-1,3,6-naphthalenetrissulfonato(8-)]di-, tetrasodium	72927-72-1	Intentional addition / 1,000ppm	chemical products
15773	Cuprate(3-), [29H.31H-phthalocyanine-C.C.C-trisulfonato(5-)-N29.N30.N31.N32]-, trihydrogen, compound with N,N'-bis(2-methylphenyl)guanidine (1.3)	72928-60-0	Intentional addition / 1,000ppm	chemical products
15774	Cuprate(3-), [29H.31H-phthalocyanine-C.C.C-trisulfonato(5-)-N29.N30.N31.N32]-, trihydrogen, compound with N,N'-bis(2-methylphenyl)guanidine (1.3)	72928-61-1	Intentional addition / 1,000ppm	chemical products
15775	Ethanaminium, N-[4-[[4-(diethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-ethyl-, [29H.31H-phthalocyanine-C.C.C-trisulfonato(5-)-N29.N30.N31.N32]cuprate(3-)(3.1)	72928-62-2	Intentional addition / 1,000ppm	chemical products
15776	Cuprate(3-), [mu-[[7-[[3,3'-dihydroxy-4-[[2-hydroxy-6-sulfo-1-naphthalenyl]azo]]1,1'-biphenyl]-4-yl]azo]-8-hydroxy-1,6-naphthalenedisulfonato(7-)]di-, trisodium	72928-71-3	Intentional addition / 1,000ppm	chemical products
15777	Chromate(5-), bis[[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-2-[[1-hydroxy-3-sulfo-7-[[3-sulfo]phenyl]amino]-2-naphthalenyl]azo]benzoato(4-)]-, pentasodium	72928-72-4	Contains (regardless of intentional or impurities)	chemical products
15778	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)](3.1)	72928-74-6	Contains (regardless of intentional or impurities)	chemical products
15779	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonato(2-)]-, hydrogen	72928-75-7	Contains (regardless of intentional or impurities)	chemical products
15780	Cobaltate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]][1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen	72928-76-8	Intentional addition / 1,000ppm	chemical products
15781	Cobaltate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]][1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen	72928-77-9	Intentional addition / 1,000ppm	chemical products
15782	Chromate(1-), [4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]][1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen	72928-78-0	Contains (regardless of intentional or impurities)	chemical products
15783	Chromate(1-), [4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]][1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen	72928-79-1	Contains (regardless of intentional or impurities)	chemical products
15784	Chromate(1-), [1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]][2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen	72928-80-4	Contains (regardless of intentional or impurities)	chemical products
15785	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen	72928-81-5	Contains (regardless of intentional or impurities)	chemical products
15786	Chromate(1-), bis[[1-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen	72928-82-6	Contains (regardless of intentional or impurities)	chemical products
15787	Chromate(1-), [1-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-2-naphthalenolato(2-)]][1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen	72928-83-7	Contains (regardless of intentional or impurities)	chemical products
15788	Chromate(1-), [1-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-2-naphthalenolato(2-)]][1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen	72928-84-8	Contains (regardless of intentional or impurities)	chemical products
15789	Chromate(1-), bis[2,4-dihydro-4-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen	72928-85-9	Contains (regardless of intentional or impurities)	chemical products
15790	Chromate(1-), bis[3-[[4-[[5-(2,2-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, hydrogen	72928-86-0	Contains (regardless of intentional or impurities)	chemical products
15791	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][4-[[5-(2,2-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, hydrogen	72928-87-1	Contains (regardless of intentional or impurities)	chemical products
15792	Chromate(1-), bis[[5-(1,1-dimethylethyl)-2-hydroxybenzoato(2-)-O1,O2]-, hydrogen	72928-88-2	Contains (regardless of intentional or impurities)	chemical products
15793	Chromate(3-), bis[6-hydroxy-5-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenesulfonato(3-)]-, trihydrogen	72928-89-3	Contains (regardless of intentional or impurities)	chemical products
15794	Chromate(1-), bis[2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-, hydrogen	72928-90-6	Contains (regardless of intentional or impurities)	chemical products
15795	Cobaltate(1-), bis[2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-, hydrogen	72928-91-7	Intentional addition / 1,000ppm	chemical products
15796	Trihydrogen bis[[4-hydroxy-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]phenyl]sulphonyl]amino]naphthalene-2-sulphonato(3-)]cobaltate(3-)	72932-56-0	Intentional addition / 1,000ppm	chemical products
15797	[1,1'-Biphenyl]-2,2'-disulfonic acid, 4,4'-bis[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-, compound with 4,4'-carbonyldiylbis[N,N-dimethylbenzenamine] (1.2)	72939-51-6	Contains (regardless of intentional or impurities)	chemical products
15798	Cuprate(4-), [mu-[[7.7'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis]azo]]bis[8-hydroxy-1,6-naphthalenedisulfonato]](8-)]di-, tetrasodium	72939-55-0	Intentional addition / 1,000ppm	chemical products
15799	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen	72939-56-1	Contains (regardless of intentional or impurities)	chemical products
15800	Chromate(1-), [2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]][2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-, hydrogen	72939-57-2	Contains (regardless of intentional or impurities)	chemical products
15801	Chromate(3-), [3-[[2-amino-5-hydroxy-6-[[2-hydroxy-5-nitro-3-sulfo]phenyl]azo]-7-sulfo-1-naphthalenyl]azo]-2-hydroxy-5-sulfo]benzoato(6-)]-, disodium hydrogen	72939-58-3	Contains (regardless of intentional or impurities)	chemical products
15802	Cuprate(3-), [29H.31H-phthalocyanine-C.C.C-trisulfonato(5-)-N29.N30.N31.N32]-, trihydrogen, compound with N,N'-diphenylguanidine (1.3)	72953-54-9	Intentional addition / 1,000ppm	chemical products
15803	Cuprate(2-), [21-carboxy-9-ethenyl-14-ethyl-13-formyl-4,8,18-trimethyl-20-oxo-3-phorbino]propanoato(4-)-N23.N24.N25.N26]-, dipotassium, [SP-4-2-[[3S-(3.alpha.,4.beta.,21.beta.)]]-	72953-55-0	Intentional addition / 1,000ppm	chemical products
15804	Borate(1-), tetrafluoro-, chromium(2+)(2.1)	72962-19-7	Intentional addition / 1,000ppm	chemical products
15805	Chromate(1-), bis[2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, lithium sodium	72968-16-2	Contains (regardless of intentional or impurities)	chemical products
15806	Chromium, 2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamide N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]methanesulfonamide sodium complexes	72968-17-3	Intentional addition / 1,000ppm	chemical products
15807	Chromium, 2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-one 3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamide 4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamide N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]acetamide sodium complexes	72968-18-4	Intentional addition / 1,000ppm	chemical products
15808	Chromium, 2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-one 4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamide N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]acetamide sodium complexes	72968-19-5	Intentional addition / 1,000ppm	chemical products
15809	Chromium, 3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamide 4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamide sodium complexes	72968-20-8	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15810	Chromium, 4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonamide N-[7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthalenyl]acetamide 4-hydroxy-3-[[5-hydroxy-naphth(2,1-d)-1,3-oxathiol-4-yl]azo]benzenesulfonamide S,S-dioxide sodium complexes	72968-21-9	Intentional addition / 1,000ppm	chemical products
15811	Chromium, 4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonamide N-[7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthalenyl]acetamide sodium complexes	72968-22-0	Intentional addition / 1,000ppm	chemical products
15812	Copper, [[[(3-[(2,5,6-trichloro-4-pyrimidinylamino)phenyl]sulfonyl)-2,9H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl sulfu derivatives, sodium salts]	72968-23-1	Intentional addition / 1,000ppm	chemical products
15813	Cuprate(4-), [7-[(5-chloro-6-methyl-2-(methylsulfonyl)-4-pyrimidinylamino)-4-hydroxy-3-[(2-hydroxy-4,7-disulfo-1-naphthalenyl)azo]-1,5-naphthalenedisulfonato(6-)-], potassium sodium	72968-24-2	Intentional addition / 1,000ppm	chemical products
15814	Zincou, cadmium yellow	72968-34-4	Contains (regardless of intentional or impurities)	chemical products
15815	Cuprate(3-), [18-carboxy-20-(carboxymethyl)-8-ethenyl-13-ethyl-2,3-dihydro-3,7,12,17-tetramethyl-21H,23H-porphine-2-propanoato(5-)-N21,N22,N23,N24]-, tripotassium, [SP-4-2-(2S-trans)-]	72984-30-6	Intentional addition / 1,000ppm	chemical products
15816	Cuprate(3-), [18-carboxy-20-(carboxymethyl)-8-ethenyl-13-ethyl-2,3-dihydro-3,7,17-trimethyl-21H,23H-porphine-2-propanoato(5-)-N21,N22,N23,N24]-, tripotassium, [SP-4-2-(2S-trans)-]	72984-31-7	Intentional addition / 1,000ppm	chemical products
15817	Cuprate(2-), [21-carboxy-9-ethenyl-14-ethyl-4,8,13,18-tetramethyl-20-oxo-3-phorbinepropanoato(4-)-N23,N24,N25,N26]-, dipotassium, [SP-4-2-[(3S-(alpha,beta,21,beta))-]]	72984-32-8	Intentional addition / 1,000ppm	chemical products
15818	Resin acids and Rosin acids, tin salts	72986-37-9	Intentional addition / 1,000ppm	chemical products
15819	Nickel, [N,N',N'',N'''-tetrakis(4-(4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl)phenyl)-2,9H,31H-phthalocyanine-C,C,O,C-tetrasulfonato(2-)-N29,N30,N31,N32]-	72986-45-9	Contains (regardless of intentional or impurities)	chemical products
15820	Xanthylum, 9-[2-(ethoxycarbonyl)phenyl]-3,6-bis(ethylamino)-2,7-dimethyl-, bis[2-hydroxy-5-nitro-3-[[2-oxo-1-(phenylamino)carbonyl]propyl]azo]benzenesulfonato(3-)]chromate(3-)(3:1)	72986-48-2	Contains (regardless of intentional or impurities)	chemical products
15821	Chromate(2-), [5-[(5-chloro-2-hydroxyphenyl)azo]-4,6-dihydroxy-2-naphthalenesulfonato(3-)]1-[[2-(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-63-1	Contains (regardless of intentional or impurities)	chemical products
15822	Chromate(2-), [5-chloro-2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)]1-[[2-(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-64-2	Contains (regardless of intentional or impurities)	chemical products
15823	Chromate(2-), [5-chloro-2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-65-3	Contains (regardless of intentional or impurities)	chemical products
15824	Chromate(2-), [5-[(5-chloro-2-hydroxyphenyl)azo]-6-hydroxy-2-naphthalenesulfonato(3-)]1-[[2-(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-66-4	Contains (regardless of intentional or impurities)	chemical products
15825	Chromate(2-), [5-[(5-chloro-2-hydroxyphenyl)azo]-6-hydroxy-2-naphthalenesulfonato(3-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-67-5	Contains (regardless of intentional or impurities)	chemical products
15826	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]4-[[2-(2-hydroxy-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzenesulfonato(3-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-68-6	Contains (regardless of intentional or impurities)	chemical products
15827	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]4-[[2-(2-hydroxy-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzenesulfonato(3-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-69-7	Contains (regardless of intentional or impurities)	chemical products
15828	Chromate(2-), [2,4-diamino-5-[(2-hydroxy-5-nitrophenyl)azo]benzenesulfonato(3-)]2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)-], dihydrogen	72986-70-0	Contains (regardless of intentional or impurities)	chemical products
15829	Chromate(2-), [2,4-diamino-5-[(2-hydroxy-5-nitrophenyl)azo]benzenesulfonato(3-)]2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-71-1	Contains (regardless of intentional or impurities)	chemical products
15830	Chromate(2-), [7-amino-4-hydroxy-3-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenesulfonato(3-)]1-[[2-(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen	72986-72-2	Contains (regardless of intentional or impurities)	chemical products
15831	Chromate(2-), [7-amino-4-hydroxy-3-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenesulfonato(3-)]1-[[2-(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-73-3	Contains (regardless of intentional or impurities)	chemical products
15832	Chromate(2-), [7-amino-4-hydroxy-3-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenesulfonato(3-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen	72986-74-4	Contains (regardless of intentional or impurities)	chemical products
15833	Chromate(2-), [7-amino-4-hydroxy-3-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenesulfonato(3-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-75-5	Contains (regardless of intentional or impurities)	chemical products
15834	Chromate(3-), [3-[(5-chloro-2-hydroxyphenyl)azo]-4,5-dihydroxy-2,7-naphthalenedisulfonato(4-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72986-77-7	Contains (regardless of intentional or impurities)	chemical products
15835	Chromate(2-), [5-chloro-3-[(1,5-dihydroxy-2-naphthalenyl)azo]-2-hydroxybenzenesulfonato(3-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen	72986-78-8	Contains (regardless of intentional or impurities)	chemical products
15836	Chromate(2-), [5-chloro-3-[(1,5-dihydroxy-2-naphthalenyl)azo]-2-hydroxybenzenesulfonato(3-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-79-9	Contains (regardless of intentional or impurities)	chemical products
15837	Chromate(3-), bis[5-chloro-2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72986-81-3	Contains (regardless of intentional or impurities)	chemical products
15838	Chromate(5-), bis[5-amino-4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-2,7-naphthalenedisulfonato(4-)-], pentahydrogen, compound with 2,2'-iminobis[ethanol] (1:5)	72986-84-6	Contains (regardless of intentional or impurities)	chemical products
15839	Chromate(3-), bis[2,4-diamino-5-[(2-hydroxy-5-nitrophenyl)azo]benzenesulfonato(3-)-], trihydrogen	72986-85-7	Contains (regardless of intentional or impurities)	chemical products
15840	Chromate(3-), bis[2,4-diamino-5-[(2-hydroxy-5-nitrophenyl)azo]benzenesulfonato(3-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72986-86-8	Contains (regardless of intentional or impurities)	chemical products
15841	Chromate(3-), bis[7-amino-4-(hydroxy-kappa.O)-3-[[2-(2-hydroxy-kappa.O)-4-nitrophenyl]diazenyl-kappa.N]]-2-naphthalenesulfonato(3-)-], hydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72986-87-9	Contains (regardless of intentional or impurities)	chemical products
15842	Chromate(3-), bis[4-(5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72986-88-0	Contains (regardless of intentional or impurities)	chemical products
15843	Chromate(3-), bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72986-89-1	Contains (regardless of intentional or impurities)	chemical products
15844	Chromate(5-), bis[3-hydroxy-4-[(1-hydroxy-8-sulfo-2-naphthalenyl)azo]-1-naphthalenesulfonato(4-)-], pentahydrogen, compound with 2,2'-iminobis[ethanol] (1:5)	72986-91-5	Contains (regardless of intentional or impurities)	chemical products
15845	Chromate(5-), bis[3-[(5-chloro-2-hydroxyphenyl)azo]-4,5-dihydroxy-2,7-naphthalenedisulfonato(4-)-], pentahydrogen, compound with 2,2'-iminobis[ethanol] (1:5)	72986-92-6	Contains (regardless of intentional or impurities)	chemical products
15846	Chromate(3-), bis[4-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(3-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72986-93-7	Contains (regardless of intentional or impurities)	chemical products
15847	Chromate(2-), [2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)-], dihydrogen	72986-94-8	Contains (regardless of intentional or impurities)	chemical products
15848	Chromate(2-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-95-9	Contains (regardless of intentional or impurities)	chemical products
15849	Chromate(2-), [5-chloro-3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxybenzenesulfonato(3-)]2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-], dihydrogen	72986-96-0	Contains (regardless of intentional or impurities)	chemical products
15850	Chromate(2-), [5-chloro-3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxybenzenesulfonato(3-)]2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72986-97-1	Contains (regardless of intentional or impurities)	chemical products
15851	Chromate(3-), [3-hydroxy-4-[(2-hydroxy-8-sulfo-1-naphthalenyl)azo]-1-naphthalenesulfonato(4-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], trihydrogen	72986-98-2	Contains (regardless of intentional or impurities)	chemical products
15852	Chromate(3-), [3-hydroxy-4-[(2-hydroxy-8-sulfo-1-naphthalenyl)azo]-1-naphthalenesulfonato(4-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72986-99-3	Contains (regardless of intentional or impurities)	chemical products
15853	Chromate(2-), [2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]-5-nitrobenzenesulfonato(3-)-], dihydrogen	72987-00-9	Contains (regardless of intentional or impurities)	chemical products
15854	Chromate(2-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]-5-nitrobenzenesulfonato(3-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72987-01-0	Contains (regardless of intentional or impurities)	chemical products
15855	Chromate(2-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-sulfobenzoato(3-)-], dihydrogen	72987-02-1	Contains (regardless of intentional or impurities)	chemical products
15856	Chromate(2-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-sulfobenzoato(3-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72987-03-2	Contains (regardless of intentional or impurities)	chemical products
15857	Chromate(3-), [8-[(5-chloro-2-hydroxyphenyl)azo]-7-hydroxy-1,3-naphthalenedisulfonato(4-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], trihydrogen	72987-04-3	Contains (regardless of intentional or impurities)	chemical products
15858	Chromate(3-), [8-[(5-chloro-2-hydroxyphenyl)azo]-7-hydroxy-1,3-naphthalenedisulfonato(4-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72987-05-4	Contains (regardless of intentional or impurities)	chemical products
15859	Cobaltate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]3-hydroxy-4-[[2-(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)-], dihydrogen	72987-06-5	Intentional addition / 1,000ppm	chemical products
15860	Cobaltate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]3-hydroxy-4-[[2-(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72987-07-6	Intentional addition / 1,000ppm	chemical products
15861	Dihydrogen [3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]1-[[2-(2-hydroxy-5-nitrophenyl)azo]-2-naphthalolato(2-)]chromate(2-)	72987-08-7	Contains (regardless of intentional or impurities)	chemical products
15862	Chromate(2-), [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]1-[[2-(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72987-09-8	Contains (regardless of intentional or impurities)	chemical products
15863	Chromate(2-), [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	72987-11-2	Contains (regardless of intentional or impurities)	chemical products
15864	Chromate(3-), [3-hydroxy-4-[(1-hydroxy-8-sulfo-2-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(4-)]1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], trihydrogen	72987-12-3	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15865	Chromate(3-), [3-hydroxy-4-[(1-hydroxy-8-sulfo-2-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(4-)]-[1-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-, trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72987-13-4	Contains (regardless of intentional or impurities)	chemical products
15866	Chromate(3-), [3-hydroxy-4-[(1-hydroxy-8-sulfo-2-naphthalenyl)azo]-1-naphthalenesulfonato(4-)]-[1-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-, trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	72987-15-6	Contains (regardless of intentional or impurities)	chemical products
15867	Chromate(2-), [5-[(5-chloro-2-hydroxyphenyl)azo]-4,6-dihydroxy-2-naphthalenesulfonato(3-)]-[1-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	73003-22-2	Contains (regardless of intentional or impurities)	chemical products
15868	Chromate(2-), [4-[4,5-dihydro-4-[(2-hydroxy-5-methyl-3-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	73003-25-5	Contains (regardless of intentional or impurities)	chemical products
15869	Chromate(2-), [5-chloro-3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxybenzenesulfonato(3-)]-[2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-, dihydrogen	73003-26-6	Contains (regardless of intentional or impurities)	chemical products
15870	Chromate(2-), [5-chloro-3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxybenzenesulfonato(3-)]-[2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	73003-27-7	Contains (regardless of intentional or impurities)	chemical products
15871	Chromate(3-), bis[4-[4,5-dihydro-4-[(2-hydroxy-5-methyl-3-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	73003-29-9	Contains (regardless of intentional or impurities)	chemical products
15872	Chromate(3-), bis[3-[(2,4-diaminophenyl)azo]-4-hydroxybenzenesulfonato(3-)-], trihydrogen	73003-30-2	Contains (regardless of intentional or impurities)	chemical products
15873	Chromate(3-), bis[3-[(2,4-diaminophenyl)azo]-4-hydroxybenzenesulfonato(3-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	73003-31-3	Contains (regardless of intentional or impurities)	chemical products
15874	Chromate(3-), bis[2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-sulfonato(3-)-], trihydrogen, compound with 2,2'-iminobis[ethanol] (1:3)	73003-32-4	Contains (regardless of intentional or impurities)	chemical products
15875	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[4-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)-, dihydrogen	73003-33-5	Contains (regardless of intentional or impurities)	chemical products
15876	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[4-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	73003-34-6	Contains (regardless of intentional or impurities)	chemical products
15877	2-Butenoic acid, 4,4'-[[diocetylstannylene]bis(oxo)]bis[4-oxo-	73003-70-0	Contains (regardless of intentional or impurities)	chemical products
15878	Arsonium tetraphenyl-, chloride, compound with hydrochloric acid (1:1)	73003-83-5	Contains (regardless of intentional or impurities)	chemical products
15879	Chromate(2-), [2,4-diamino-5-[(2-hydroxy-5-nitrophenyl)azo]benzenesulfonato(3-)]-[2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-, dihydrogen	73003-92-6	Contains (regardless of intentional or impurities)	chemical products
15880	Chromate(2-), [2,4-diamino-5-[(2-hydroxy-5-nitrophenyl)azo]benzenesulfonato(3-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-, dihydrogen	73003-93-7	Contains (regardless of intentional or impurities)	chemical products
15881	Chromate(2-), [6-amino-5-[(2-hydroxy-4-nitrophenyl)azo]-1-naphthalenesulfonato(3-)]-[2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)-, dihydrogen	73003-94-8	Contains (regardless of intentional or impurities)	chemical products
15882	Chromate(3-), [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-hydroxy-4-[(2-hydroxy-8-sulfo-1-naphthalenyl)azo]-1-naphthalenesulfonato(3-)-], trihydrogen	73003-95-9	Contains (regardless of intentional or impurities)	chemical products
15883	Chromate(2-), [2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]-[2-hydroxy-5-nitro-3-[[2-oxo-1-[(phenylamino)carbonyl]propyl]azo]benzenesulfonato(3-)-], dihydrogen	73003-96-0	Contains (regardless of intentional or impurities)	chemical products
15884	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[2-hydroxy-5-nitro-3-[[2-oxo-1-[(phenylamino)carbonyl]propyl]azo]benzenesulfonato(3-)-], dihydrogen	73003-97-1	Contains (regardless of intentional or impurities)	chemical products
15885	Chromate(2-), [2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]-5-nitrobenzenesulfonato(3-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-, dihydrogen	73003-98-2	Contains (regardless of intentional or impurities)	chemical products
15886	Manganate(2-), [3-[(4,8-disulfo-2-naphthalenyl)azo]-2-hydroxybenzoato(4-)-], dihydrogen	73003-99-3	Contains (regardless of intentional or impurities)	chemical products
15887	Benzenamine, reaction products with dodecylnitrobenzene and nitrobenzene, hydrochloric acid-iron catalyzed	73018-40-3	Intentional addition / 1%	chemical products
15888	Copper, [29H,31H-phthalocyaninetetra-sulfonamido(2-)-N29,N30,N31,N32]-, N-dodecyl derivatives	73018-42-5	Intentional addition / 1,000ppm	chemical products
15889	Copper, [29H,31H-phthalocyaninetetra-sulfonamido(2-)-N29,N30,N31,N32]-, N-(2-ethylhexyl and 3-methoxypropyl) derivatives	73018-43-6	Intentional addition / 1,000ppm	chemical products
15890	Cuprate(3-), [3-[(5-chloro-2-hydroxy-4-sulfoxyphenyl)azo]-6-[[[2,3-dichloro-6-quinoxalyl]carbonyl]amino]-4-hydroxy-2,7-naphthalenedisulfonato(5-)-], potassium sodium	73018-44-7	Intentional addition / 1,000ppm	chemical products
15891	Cuprate(3-), [29H,31H-phthalocyaninetetra-sulfonamido(2-)-N29,N30,N31,N32]-, potassium, compounds with polyethylene glycol ether with triethanolamine (3:1)	73018-45-8	Intentional addition / 1,000ppm	chemical products
15892	Cuprate(4-), [7-[(5-chloro-2,6-difluoro-4-pyrimidinylamino)-4-hydroxy-3-[(2-hydroxy-4,7-disulfo-1-naphthalenyl)azo]-1,5-naphthalenedisulfonato(6-)-], potassium sodium	73018-46-9	Intentional addition / 1,000ppm	chemical products
15893	Cuprate(4-), [3-[[[5-chloro-6-methyl-2-(methylsulfonyl)-4-pyrimidinylamino]-1-hydroxy-3,6-disulfo-2-naphthalenyl)azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)-], potassium sodium	73018-47-0	Intentional addition / 1,000ppm	chemical products
15894	Platinum, dicarbonyldichloro-, reaction products with 2,4,6-triethenyl-2,4,6-trimethylcyclotrisiloxane	73018-55-0	Contains (regardless of intentional or impurities)	chemical products
15895	Chromate(3-), bis[6-amino-5-[(2-hydroxy-4-nitrophenyl)azo]-1-naphthalenesulfonato(3-)-], trihydrogen	73018-70-9	Contains (regardless of intentional or impurities)	chemical products
15896	Chromate(3-), [3-[(5-chloro-2-hydroxyphenyl)azo]-4,5-dihydroxy-2,7-naphthalenesulfonato(4-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], trihydrogen	73018-71-0	Contains (regardless of intentional or impurities)	chemical products
15897	Chromate(2-), [5-chloro-2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)]-[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-, dihydrogen	73018-72-1	Contains (regardless of intentional or impurities)	chemical products
15898	Chromate(3-), bis[5-[(5-chloro-2-hydroxyphenyl)azo]-4,6-dihydroxy-2-naphthalenesulfonato(3-)-], trihydrogen	73018-73-2	Contains (regardless of intentional or impurities)	chemical products
15899	Chromate(3-), bis[4-[4,5-dihydro-4-[(2-hydroxy-5-methyl-3-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)-], trihydrogen	73018-74-3	Contains (regardless of intentional or impurities)	chemical products
15900	Chromate(3-), [8-[(5-chloro-2-hydroxyphenyl)azo]-7-hydroxy-1,3-naphthalenedisulfonato(4-)]-[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-], trihydrogen	73018-75-4	Contains (regardless of intentional or impurities)	chemical products
15901	Chromate(3-), [8-[(5-chloro-2-hydroxyphenyl)azo]-7-hydroxy-1,3-naphthalenedisulfonato(4-)]-[2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-], trihydrogen	73018-76-5	Contains (regardless of intentional or impurities)	chemical products
15902	Chromate(2-), [4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonato(3-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen	73018-77-6	Contains (regardless of intentional or impurities)	chemical products
15903	Chromate(3-), [5-amino-4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-2,7-naphthalenedisulfonato(4-)]-[2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)-], trihydrogen	73018-78-7	Contains (regardless of intentional or impurities)	chemical products
15904	Chromate(2-), [2,4-diamino-5-[(2-hydroxy-5-nitrophenyl)azo]benzenesulfonato(3-)]-[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)-], dihydrogen	73018-79-8	Contains (regardless of intentional or impurities)	chemical products
15905	Molybdate(6-), [orthosilicate(4-)]trihexacontaoxotetracosaa-, hexahydrogen, compound with 4-bis[4-(diethylamino)phenyl]methyl-N-ethyl-1-naphthalenamine (1:6)	73018-83-4	Contains (regardless of intentional or impurities)	chemical products
15906	Cobaltate(3-), bis[2-[[[4-hydroxy-3-[[2-oxo-1-[(phenylamino)carbonyl]propyl]azo]phenyl]sulfonyl]amino]benzoato(3-)-], sodium dihydrogen	73018-84-5	Intentional addition / 1,000ppm	chemical products
15907	Chromate(1-), bis[4-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxy-N-methylbenzenesulfonamido(2-)-], hydrogen	73018-85-6	Contains (regardless of intentional or impurities)	chemical products
15908	Chromate(1-), bis[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamido(2-)-], hydrogen	73018-86-7	Contains (regardless of intentional or impurities)	chemical products
15909	Cuprate(3-), [mu-, [2-[[4,5-dihydro-1-[4-[[3-hydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl)azo]-7-sulfo-1-naphthalenyl]azo]phenyl]-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(7-)]di-, trisodium	73018-87-8	Intentional addition / 1,000ppm	chemical products
15910	2-Naphthalenecarboxylic acid, 3-hydroxy-4-[(6-sulfo-2-naphthalenyl)azo]-, manganese(2+) salt (1:1)	73019-26-8	Contains (regardless of intentional or impurities)	chemical products
15911	Cobaltate(5-), bis[5-[(4-amino-6-chloro-1,3,5-triazin-2-yl)amino]-4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-2,7-naphthalenedisulfonato(4-)-], tetrapotassium sodium	73038-30-9	Intentional addition / 1,000ppm	chemical products
15912	Chromate(5-), bis[5-[(4-amino-6-chloro-1,3,5-triazin-2-yl)amino]-4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-2,7-naphthalenedisulfonato(4-)-], tetrapotassium sodium	73038-31-0	Contains (regardless of intentional or impurities)	chemical products
15913	Cuprate(3-), [2-[[[aminosulfonyl]disulfo-29H,31H-phthalocyaninyl]sulfonyl]amino]-5-[(5-chloro-2,6-difluoro-4-pyrimidinylamino)benzoato(5-)-N29,N30,N31,N32]-, disodium hydrogen	73038-37-6	Intentional addition / 1,000ppm	chemical products
15914	Amines, rosin, compounds with 6'-(diethylamino)-3'-hydroxy-3'-oxo-spiro[isobenzofuran-1(3H),9'-[9H]xanthen]-2'-carboxylic acid and sodium bis[2-hydroxybenzoato(2-)-O1,O2]chromate(1-)	73049-38-4	Contains (regardless of intentional or impurities)	chemical products
15915	Chromium, 2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-one 2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoate sodium complexes	73049-90-8	Intentional addition / 1,000ppm	chemical products
15916	Chromium, N-[8-[[5-(ethylsulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]methanesulfonamide 2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-one 2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoate sodium complexes	73049-91-9	Intentional addition / 1,000ppm	chemical products
15917	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfo [[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]sulfonyl derivatives	73049-92-0	Intentional addition / 1,000ppm	chemical products
15918	Calcium chloride (CaCl2), mixture with copper hydroxide	73050-33-6	Intentional addition / 1,000ppm	chemical products
15919	Tribromo(2-bromomethyl)benzene	73056-39-0	Intentional addition / 1,000ppm	chemical products
15920	Nicotine, malate (1:1)	73057-36-0	Contains (regardless of intentional or impurities)	chemical products
15921	Chromium, 1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphthalenol 1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenol sodium complexes	73070-35-6	Intentional addition / 1,000ppm	chemical products
15922	Chromium, 2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-1-phenyl-3H-pyrazol-3-one 1-[[2-hydroxynitrophenyl)azo]-2-naphthalenol lithium sodium complexes	73070-36-7	Intentional addition / 1,000ppm	chemical products
15923	Cuprate(4-), [mu-, [[3,3'-[(3,3'-dihydroxy(1,1'-biphenyl)-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulfonato]](8-)]di-, diethanolamine sodium salts	73070-37-8	Intentional addition / 1,000ppm	chemical products
15924	(S)-Nicotine citrate	73086-01-8	Contains (regardless of intentional or impurities)	chemical products
15925	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, phosphate	73086-02-9	Contains (regardless of intentional or impurities)	chemical products
15926	Butanedioic acid, hydroxy-, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine	73086-03-0	Contains (regardless of intentional or impurities)	chemical products
15927	Arsenic acid, copper(2+) salt, hydrate, (2:3:3)	73158-86-2	Contains (regardless of intentional or impurities)	chemical products
15928	Copper bis(methylbenzenesulphonate)	73188-73-5	Intentional addition / 1,000ppm	chemical products
15929	Chromate(5-), bis[4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-5-[(2,6,6-trichloro-4-pyrimidinyl)amino]-2,7-naphthalenedisulfonato(4-)-], pentasodium	73195-16-1	Contains (regardless of intentional or impurities)	chemical products
15930	Cobaltate(1-), [6-amino-5-[(2-hydroxy-4-nitrophenyl)azo]-N-(2-hydroxypropyl)-2-naphthalenesulfonamido(2-)]-[1-[[5-chloro-2-hydroxyphenyl)azo]-2-naphthalenolato(2-)-], sodium	73195-17-2	Intentional addition / 1,000ppm	chemical products
15931	Tricarbonyl methylcyclopentadienyl manganese	73207-48-4	Contains (regardless of intentional or impurities)	chemical products
15932	2-Pentene, 1-bromo-3,4-dimethyl-, (E)-	73236-84-7	Intentional addition / 1,000ppm	chemical products
15933	Dodecyl 4,4'-diocetyl-7-oxo-8-oxa-3,5-dithia-4-stannaicosanoate	73246-85-2	Contains (regardless of intentional or impurities)	chemical products
15934	Formic acid, chromium(3+) salt, basic	73246-98-7	Intentional addition / 1,000ppm	chemical products
15935	2-(Benzothiazol-2-yl)oxy-N-methyl-N-phenylacetamide	73250-68-7	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15936	Chromate(1-), [2-[[[4,5-dihydro-3-methyl-1-(3-methylphenyl)-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-, sodium	73275-56-6	Contains (regardless of intentional or impurities)	chemical products
15937	Chromate(1-), bis[2-[[[4,5-dihydro-3-methyl-1-(3-methylphenyl)-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-, sodium	73275-57-7	Contains (regardless of intentional or impurities)	chemical products
15938	Chromate(1-), [1-[[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]][2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	73287-39-5	Contains (regardless of intentional or impurities)	chemical products
15939	Chromate(2-), [4-[[4,5-dihydro-4-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]][2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen	73287-40-8	Contains (regardless of intentional or impurities)	chemical products
15940	Chromate(2-), [2-[[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfophenyl)-1H-pyrazol-4-yl]azo]benzoato(3-)]][1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, dihydrogen	73287-41-9	Contains (regardless of intentional or impurities)	chemical products
15941	Chromate(2-), [2-[[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfophenyl)-1H-pyrazol-4-yl]azo]benzoato(3-)]][1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	73287-43-1	Contains (regardless of intentional or impurities)	chemical products
15942	Chromate(4-), [4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfonylphenyl]azo]-6-[[sulfomethylamino]-2-naphthalenesulfonato(5-)]][1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, tetrahydrogen	73287-44-2	Contains (regardless of intentional or impurities)	chemical products
15943	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, dihydrogen	73287-45-3	Contains (regardless of intentional or impurities)	chemical products
15944	Chromate(2-), [2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]][1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-, dihydrogen	73287-46-4	Contains (regardless of intentional or impurities)	chemical products
15945	Cuprate(3-), [mu-[[3-[[3,3'-dihydroxy-4'-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(7-)]][di-, trisodium	73287-47-5	Intentional addition / 1,000ppm	chemical products
15946	Cuprate(3-), [4-hydroxy-3-[[3-hydroxy-4'-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-3'-methoxy[1,1'-biphenyl]-4-yl]azo]-1,5-naphthalenedisulfonato(5-)]-, trisodium	73287-48-6	Intentional addition / 1,000ppm	chemical products
15947	2,7-Naphthalenedisulfonic acid, 5-amino-3-[[4-[[6-amino-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-4-hydroxy-, trisodium salt	73287-56-6	Intentional addition	chemical products
15948	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfo [[6-sulfo-8-[[2-(sulfooxy)ethyl]sulfonyl]-2-naphthalenyl]amino]sulfonyl derivatives, potassium salts	73296-92-1	Intentional addition / 1,000ppm	chemical products
15949	Chromate(2-), [3-[[2,4-diaminophenyl]azo]-4-hydroxybenzenesulfonato(3-)]][2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-1-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen	73297-00-4	Contains (regardless of intentional or impurities)	chemical products
15950	Chromate(2-), [2,4-diamino-5-[[2-hydroxy-5-nitrophenyl]azo]benzenesulfonato(3-)]][2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen	73297-01-5	Contains (regardless of intentional or impurities)	chemical products
15951	Cobaltate(1-), bis[1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-, sodium	73297-09-3	Intentional addition / 1,000ppm	chemical products
15952	Cobaltate(3-), bis[6-amino-5-[[2-hydroxy-3,5-dinitrophenyl]azo]-1-naphthalenesulfonato(3-)]-, sodium dihydrogen	73297-10-6	Intentional addition / 1,000ppm	chemical products
15953	Chromate(3-), [2-hydroxy-3-[[2-hydroxy-8-[[methoxycarbonyl]amino]-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]][2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonato(3-)]-, trisodium	73297-11-7	Contains (regardless of intentional or impurities)	chemical products
15954	Chromate(1-), bis[methyl [0-[[5-[[ethylamino]sulfonyl]-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]carbamato(2-)]-, sodium	73297-12-8	Contains (regardless of intentional or impurities)	chemical products
15955	Chromate(1-), bis[2-[[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-, hydrogen, compound with 1-tridecanamine (1:1)	73297-13-9	Contains (regardless of intentional or impurities)	chemical products
15956	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 1-tridecanamine (1:1)	73297-15-1	Contains (regardless of intentional or impurities)	chemical products
15957	Cobaltate(1-), [4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]][8-[[2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]-, hydrogen, compound with 3-[[2-ethylhexyl]oxy]-1-propanamine (1:1)	73297-17-3	Intentional addition / 1,000ppm	chemical products
15958	Xanthylum, 3-(diethylamino)-9-[[2-ethoxycarbonyl]phenyl]-6-(ethylamino)-, [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)	73297-20-8	Contains (regardless of intentional or impurities)	chemical products
15959	Iron, [mu-[[3,3'-methylenebis[[4,6-dihydroxy-3,1-phenylene]azo]bis[4-hydroxy-5-nitrobenzenesulfonato(3-)]][di-, dihydrochloride	73297-21-9	Intentional addition / 1%	chemical products
15960	Cuprate(1-), [4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, hydrogen	73297-22-0	Intentional addition / 1,000ppm	chemical products
15961	Ferrate(3-), bis[6-hydroxy-5-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenesulfonato(3-)]-, trihydrogen	73297-23-1	Intentional addition / 1%	chemical products
15962	Cuprate(2-), [[4,4'-[[2-hydroxy-1,4-phenylene]bis[azo(4,5-dihydro-3-methyl-5-oxo-1H-pyrazole-4,1-diy)]bis[3-methylbenzenesulfonato(4-)]]-4-], disodium	73297-24-2	Intentional addition / 1,000ppm	chemical products
15963	Cuprate(5-), [[3,3'-methylenebis[6-[[3-[[2,4-disulfonylphenyl]azo]-2,4-dihydroxyphenyl]azo]benzoato(1,7-)]-, pentasodium	73297-25-3	Intentional addition / 1,000ppm	chemical products
15964	Cuprate(4-), [mu-[[5-(acetyl)amino]-3-[[3,3'-dihydroxy-4'-[[1-hydroxy-3,6-disulfo-2-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(8-)]-, tetrasodium	73297-26-4	Intentional addition / 1,000ppm	chemical products
15965	Cuprate(1-), [4-[[[dihydroxy[[2-hydroxy-3,5-dinitrophenyl]azo]phenyl]azo]benzenesulfonato(3-)]-, hydrogen	73297-36-6	Intentional addition / 1,000ppm	chemical products
15966	Cuprate(3-), [2-[[[aminosulfonyl]disulfo-29H,31H-phthalocyaninyl]sulfonyl]amino]-5-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]benzoato(5-)-N29,N30,N31,N32]-, trihydrogen	73323-17-8	Intentional addition / 1,000ppm	chemical products
15967	Cobaltate(3-), bis[5-chloro-2-hydroxy-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, trisodium	73324-01-3	Intentional addition / 1,000ppm	chemical products
15968	Cobaltate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen	73324-02-4	Intentional addition / 1,000ppm	chemical products
15969	Cuprate(2-), [4-[[4,5-dihydro-4-[[4-[[4-[[4,5-dihydro-3-methyl-1-(2-methyl-5-sulfonylphenyl)-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxyphenyl]methyl]phenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]-5-methylbenzenesulfonato(4-)]-, disodium	73324-03-5	Intentional addition / 1,000ppm	chemical products
15970	Chromate(3-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, sodium dihydrogen	73324-04-6	Contains (regardless of intentional or impurities)	chemical products
15971	Chromate(3-), bis[5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(3-)]-, trisodium	73324-05-7	Contains (regardless of intentional or impurities)	chemical products
15972	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-, sodium	73324-06-8	Contains (regardless of intentional or impurities)	chemical products
15973	Chromium, [6-hydroxy-5-[[2-hydroxyphenyl]azo]-2-naphthalenesulfonato(3-)]-	73324-10-4	Intentional addition / 1,000ppm	chemical products
15974	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, sodium	73334-12-0	Contains (regardless of intentional or impurities)	chemical products
15975	Chromate(1-), [5-hydroxy-4-[[1-hydroxy-2-naphthalenyl]azo]-2-methylbenzenesulfonamidato(2-)]][methyl[8-[[5-aminosulfonyl]-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]carbamato(2-)]-, sodium	73347-81-6	Contains (regardless of intentional or impurities)	chemical products
15976	Chromate(7-), bis[4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfonylphenyl]azo]-6-[[sulfomethylamino]-2-naphthalenesulfonato(5-)]-, heptahydrogen	73360-60-8	Contains (regardless of intentional or impurities)	chemical products
15977	Chromate(2-), [4-[[4,5-dihydro-4-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]][2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	73360-61-9	Contains (regardless of intentional or impurities)	chemical products
15978	Chromate(2-), [3-[[2,4-diaminophenyl]azo]-4-hydroxybenzenesulfonato(3-)]][2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	73360-62-0	Contains (regardless of intentional or impurities)	chemical products
15979	Chromate(2-), [2,4-diamino-5-[[2-hydroxy-5-nitrophenyl]azo]benzenesulfonato(3-)]][2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	73360-63-1	Contains (regardless of intentional or impurities)	chemical products
15980	Chromate(4-), [4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfonylphenyl]azo]-6-[[sulfomethylamino]-2-naphthalenesulfonato(5-)]][1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, tetrahydrogen, compound with 2,2'-iminobis[ethanol] (1:4)	73360-64-2	Contains (regardless of intentional or impurities)	chemical products
15981	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]][2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, dihydrogen, compound with 2,2'-iminobis[ethanol] (1:2)	73360-65-3	Contains (regardless of intentional or impurities)	chemical products
15982	Zirconium, bis[[1,2,3,4,5-eta]-1-butyl-2,4-cyclopentadien-1-yl]dichloro	73364-10-0	Contains (regardless of intentional or impurities)	chemical products
15983	Chromate(1-), bis[2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, lithium sodium	73378-61-7	Contains (regardless of intentional or impurities)	chemical products
15984	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl derivatives	73378-62-8	Intentional addition / 1,000ppm	chemical products
15985	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with 2-[[4-aminophenyl]amino]-5-nitrobenzenesulfonic acid, sodium salts	73378-63-9	Intentional addition / 1,000ppm	chemical products
15986	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with 9-methyl-1-decanamine	73378-64-0	Intentional addition / 1,000ppm	chemical products
15987	Copper, [29H,31H-phthalocyaninetetrasulfonyl tetrachloridato(2-)-N29,N30,N31,N32]-, reaction products with 4-methyl-1-pentanamine	73378-65-1	Intentional addition / 1,000ppm	chemical products
15988	Benzenesulfonic acid, 2-[[1-[[2-(methoxyphenyl)amino]carbonyl]-2-oxopropyl]azo]-5-methyl-, barium salt (2:1)	73384-86-8	Contains (regardless of intentional or impurities)	chemical products
15989	Benzenesulfonic acid, 4-chloro-2-[[2-hydroxy-3-[[2-(methoxyphenyl)amino]carbonyl]-1-naphthalenyl]azo]-5-methyl-, manganese(2+) salt (2:1)	73384-91-5	Contains (regardless of intentional or impurities)	chemical products
15990	2-Naphthalenecarboxylic acid, 4-[[4-chloro-3-sulfonylphenyl]azo]-3-hydroxy-, manganese(2+) salt (1:1)	73385-04-3	Contains (regardless of intentional or impurities)	chemical products
15991	Quaternary ammonium compounds, di-C8-18-alkyldimethyl, chlorides	73398-64-8	Intentional addition / 1,000ppm	chemical products
15992	3H-Indolum, 3-ethyl-1,3-dimethyl-2-[[methylphenyl]hydrazono]methyl-, bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]chromate(3-)] (3:1)	73398-67-1	Contains (regardless of intentional or impurities)	chemical products
15993	Chromate(8-), bis[5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfothio)phenyl]-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(4-)]-, mu-[[5-S-[[1,2-ethanedithiol]bis[iminosulfonyl(2-hydroxy-4,1-phenylene)azo(4,5-dihydro-3-methyl-5-oxo-1H-pyrazole-4,1-diy)]-4,1-phenylene] bis(monothiosulfato)](6-)]di-, octasodium	73398-68-2	Contains (regardless of intentional or impurities)	chemical products
15994	Platinum(4+), tris[1,2-propanediamine.N.N)]-, salt with 2-ethylhexanoic acid (1:4)	73398-92-2	Contains (regardless of intentional or impurities)	chemical products
15995	Boric acid (HBO2), compound with N-methylmethanamine (5:1)	73398-94-4	Intentional addition / 1%	chemical products
15996	Boron nitride (B2N)	73412-80-3	Intentional addition / 1%	chemical products
15997	Cuprate(1-), [29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen, compound with 1-dodecanamine (1:1)	73455-75-1	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
15998	Cobaltate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[2-[[4-hydroxy-3-[[2-(phenylamino)-1-naphthalenyl]azo]phenyl]sulfonyl]amino]benzoato(3-)]-, sodium hydrogen	73455-76-2	Intentional addition / 1,000ppm	chemical products
15999	Hydrazine, diperchlorate, dihydrate	73487-82-2	Intentional addition / 1,000ppm	chemical products
16000	Hydrazine selenate	73506-32-8	Contains (regardless of intentional or impurities)	chemical products
16001	Chromate(1-), [3-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-[3-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen	73507-06-9	Contains (regardless of intentional or impurities)	chemical products
16002	Chromate(1-), [3-[4,5-dihydro-4-[(2-hydroxy-5-methyl-3-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-[3-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, hydrogen	73507-08-1	Contains (regardless of intentional or impurities)	chemical products
16003	Hydrogen [2-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-[N-[7-hydroxy-8-[[2-hydroxy-5-sulphamoyl]phenyl]azo]-1-naphthyl]acetamidato(2-)]chromate(1-)	73507-09-2	Contains (regardless of intentional or impurities)	chemical products
16004	Hydrogen [4-hydroxy-3-[(2-hydroxy-1-naphthyl)azo]benzenesulfonamidato(2-)]-[N-[7-hydroxy-8-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthyl]acetamidato(2-)]chromate(1-)	73507-10-5	Contains (regardless of intentional or impurities)	chemical products
16005	Sodium hydrogen [2-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-sulphobenzoato(3-)]-[2-[[4,5-dihydro-5-oxo-1,3-diphenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(2-)	73507-13-8	Contains (regardless of intentional or impurities)	chemical products
16006	Sodium hydrogen [N-(2-chlorophenyl)-2-[(2-hydroxy-5-nitrophenyl)azo]-3-oxobutyl]amidato(2-)]-[3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]chromate(2-)	73507-15-0	Contains (regardless of intentional or impurities)	chemical products
16007	Hydrogen sodium [1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalato(2-)]-[4-hydroxy-3-[(2-hydroxy-4-nitrophenyl)azo]naphthalene-1-sulphonato(3-)]chromate(2-)	73507-16-1	Contains (regardless of intentional or impurities)	chemical products
16008	Hydrogen tetrasodium bis[2-[[6-[[4-chloro-6-[[3-sulphoanilino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulpho-2-naphthyl]azo]benzoato(4-)]chromate(5-)	73507-17-2	Contains (regardless of intentional or impurities)	chemical products
16009	Chromate(5-), [2-[[6-[[4-chloro-6-[[3-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(4-)]-[2-[[6-[[4-chloro-6-[[4-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(4-)]-, tetrasodium hydrogen	73507-18-3	Contains (regardless of intentional or impurities)	chemical products
16010	Tetrasodium [2-[[1-hydroxy-3-sulpho-6-[[3-sulpho-4-[[2-[[sulpho-4-[[4-[[4-sulphophenyl]azo]phenyl]-ONN-azoxy]phenyl]vinyl]phenyl]-NNO-azoxy]-2-naphthyl]azo]benzoato(6-)]cuprate(4-)	73507-19-4	Intentional addition / 1,000ppm	chemical products
16011	Trisodium [mu-[[7-[[3,3'-dihydroxy-4'-[(2-hydroxy-6-sulpho-1-naphthyl)azo]]1,1'-biphenyl]-4-yl]azo]-8-hydroxy-naphthalene-1,6-disulphonato(7-)]dicuprate(3-)	73507-21-8	Intentional addition / 1,000ppm	chemical products
16012	Trisodium [mu-[[3-[[4-[[6-anilino-1-hydroxy-3-sulpho-2-naphthyl]azo]-3,3'-dihydroxy[[1,1'-biphenyl]-4-yl]azo]-4-hydroxy-naphthalene-2,7-disulphonato(7-)]dicuprate(3-)]	73507-22-9	Intentional addition / 1,000ppm	chemical products
16013	Tetrasodium [mu-[[7-[[8-amino-1-hydroxy-3,6-disulpho-2-naphthyl]azo]-3,3'-dihydroxy[[1,1'-biphenyl]-4-yl]azo]-8-hydroxy-naphthalene-1,3-disulphonato(8-)]dicuprate(4-)	73507-23-0	Intentional addition / 1,000ppm	chemical products
16014	Cuprate(4-), [mu-3-[[7-[[6-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3,3'-dihydroxy[[1,1'-biphenyl]-4-yl]azo]-1,5-dihydroxy-7-sulfo-2-naphthalenyl]azo]-8-hydroxy-1,3,6-naphthalenesulfonato(10-)]tri-, tetrasodium	73507-24-1	Intentional addition / 1,000ppm	chemical products
16015	Tetrasodium hydrogen bis[5-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]-2-[[1-hydroxy-3-sulpho-7-(3-sulphoanilino)-2-naphthyl]azo]benzoato(4-)]chromate(5-)	73507-25-2	Contains (regardless of intentional or impurities)	chemical products
16016	Cuprate(5-), [2-[[4-chloro-6-[[methyl(2-methyl-5-sulphophenyl)amino]-1,3,5-triazin-2-yl]amino]-6-[[4-[[2,5-disulphophenyl]azo]-2-hydroxy-5-methylphenyl]azo]-5-hydroxy-1,7-naphthalenedisulfonato(7-)]-, pentasodium	73507-26-3	Intentional addition / 1,000ppm	chemical products
16017	Cuprate(6-), [mu-[[4-[[8-[[4-chloro-6-[[3-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3,6-disulfo-2-naphthalenyl]azo]-4-[[1-hydroxy-3,6,8-trisulfo-2-naphthalenyl]azo]]1,1'-biphenyl]-3,3'-dicarboxylato(10-)]di-, hexasodium	73507-27-4	Intentional addition / 1,000ppm	chemical products
16018	Cuprate(6-), [mu-[[2,2'-[[6-(4-morpholinyl)-1,3,5-triazine-2,4-diy]bis[imino(2-sulfo-4,1-phenylene)-2,1-ethenediyl(3-sulfo-4,1-phenylene)(4,5-dihydro-3-methyl-5-oxo-1H-pyrazole-1,4-diy]azo]]bis[5-sulfo]benzoato(10-)]di-, hexasodium	73507-28-5	Intentional addition / 1,000ppm	chemical products
16019	Cuprate(5-), [3-[4-[[5-[[4-[[3-[[[aminosulfonyl]sulfo-29H,31H-phthalocyaninyl]sulfonyl]amino]-4-sulphophenyl]amino]-6-chloro-1,3,5-triazin-2-yl]amino]-2-sulphophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-1,5-naphthalenedisulfonato(7-)]-, N29,N30,N31,N32]-, pentasodium	73507-29-6	Intentional addition / 1,000ppm	chemical products
16020	Iron, [3-[[3-[[5-chloro-2-hydroxyphenyl]azo]-2,6-dihydroxyphenyl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-	73507-31-0	Intentional addition / 1%	chemical products
16021	Cuprate(1-), [29H,31H-phthalocyaninesulfonato(3-)]-, N29,N30,N31,N32]-, chlorinated, compounds with 1-dodecanamine	73507-37-6	Intentional addition / 1,000ppm	chemical products
16022	Copper, [29H,31H-phthalocyaninato(2-)]-, N29,N30,N31,N32]-, aminosulfonyl sulfo [[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]sulfonyl derivatives	73507-39-8	Intentional addition / 1,000ppm	chemical products
16023	Cobaltate(1-), bis[methyl [8-[[4-[[aminosulfonyl]-2-hydroxy-5-methoxyphenyl]azo]-7-hydroxy-1-naphthalenyl]carbamato(2-)]-, sodium	73507-63-8	Intentional addition / 1,000ppm	chemical products
16024	Chromate(3-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]-, sodium dihydrogen	73507-64-9	Contains (regardless of intentional or impurities)	chemical products
16025	Chromate(1-), [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	73507-65-0	Contains (regardless of intentional or impurities)	chemical products
16026	Cobaltate(1-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[1-(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, sodium	73507-66-1	Intentional addition / 1,000ppm	chemical products
16027	Cobaltate(1-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[1-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, sodium	73507-67-2	Intentional addition / 1,000ppm	chemical products
16028	Chromate(1-), bis[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonamidato(2-)]-, sodium	73507-68-3	Contains (regardless of intentional or impurities)	chemical products
16029	Chromate(1-), [3-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonamidato(2-)]-, sodium	73507-69-4	Contains (regardless of intentional or impurities)	chemical products
16030	Ferrate(1-), [3-[[2,4-dihydroxy-5-[[4-nitro-2-sulphophenyl]azo]phenyl]azo]-2-hydroxy-5-nitrobenzenesulfonato(4-)]-, hydrogen, monohydrochloride	73507-70-7	Intentional addition / 1%	chemical products
16031	Cuprate(2-), [3-[[2,4-dihydroxy-3-[[4-nitro-2-sulphophenyl]azo]phenyl]azo]-2-hydroxy-5-nitrobenzenesulfonato(4-)]-, dihydrogen	73507-71-8	Intentional addition / 1,000ppm	chemical products
16032	Trisodium bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]methylene]amino]-2-hydroxy-5-nitrobenzenesulphonato(3-)]chromate(3-)	73507-72-9	Contains (regardless of intentional or impurities)	chemical products
16033	Cobaltate(3-), bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, sodium dihydrogen	73507-73-0	Intentional addition / 1,000ppm	chemical products
16034	Hexanes, branched isomers	73513-42-5	Intentional addition / 1,000ppm	chemical products
16035	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, sodium hydrogen	73513-78-7	Contains (regardless of intentional or impurities)	chemical products
16036	Sodium hydrogen [5,8-dichloro-2-[[5-chloro-2-hydroxyphenyl]azo]-1-naphthalato(2-)]-[4-hydroxy-3-[[2-hydroxy-4-nitrophenyl]azo]naphthalene-1-sulphonato(3-)]chromate(2-)	73513-79-8	Contains (regardless of intentional or impurities)	chemical products
16037	Hydrogen tetrasodium bis[2-[[6-[[4-chloro-6-[[4-sulphoanilino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulpho-2-naphthyl]azo]benzoato(4-)]chromate(5-)	73513-80-1	Contains (regardless of intentional or impurities)	chemical products
16038	Cuprate(5-), [4-[[8-hydroxy-7-[[2-hydroxy-4-[[3-sulfo-4-[[2-[[2-sulfo-4-[[4-[[4-sulphophenyl]azo]phenyl]-ONN-azoxy]phenyl]ethenyl]phenyl]-NNO-azoxy]phenyl]azo]-6-sulfo-2-naphthalenyl]amino]benzoato(7-)]-, tetrasodium hydrogen	73513-81-2	Intentional addition / 1,000ppm	chemical products
16039	Cuprate(4-), [mu-[[4-hydroxy-7-[[4-[[2-hydroxyethyl]amino]-6-[[5-hydroxy-6-[[2-hydroxy-4-sulphophenyl]azo]-7-sulfo-2-naphthalenyl]amino]-1,3,5-triazin-2-yl]-3-[[2-hydroxy-4-sulphophenyl]azo]-2-naphthalenesulfonato(8-)]di-, tetrasodium	73513-82-3	Intentional addition / 1,000ppm	chemical products
16040	Cuprate(2-), [mu-[[3,3'-[[methylenebis(4,6-dihydroxy-3,1-phenylene)azo]]bis[4-hydroxy-5-nitrobenzenesulfonato(6-)]di-, dihydrogen	73514-01-9	Intentional addition / 1,000ppm	chemical products
16041	Cuprate(2-), [mu-[[4,4'-[[methylenebis(2-hydroxy-4,1-phenylene)azo(4,5-dihydro-3-methyl-5-oxo-1H-pyrazole-4,1-diy)]bis[3-methylbenzenesulfonato(6-)]di-, disodium	73514-02-0	Intentional addition / 1,000ppm	chemical products
16042	Cuprate(4-), [mu-[[4,4'-[[methylenebis(2-hydroxy-4,1-phenylene)azo]]bis[3-hydroxy-2,7-naphthalenedisulfonato(8-)]di-, tetrasodium	73514-03-1	Intentional addition / 1,000ppm	chemical products
16043	Chromate(3-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, triammonium	73514-04-2	Contains (regardless of intentional or impurities)	chemical products
16044	Tin chloride (SnCl2), hydrate (2.3)	73520-82-8	Contains (regardless of intentional or impurities)	chemical products
16045	Propane-1,2-diamino-N,N,N'-triacetate, iron(III), sodium	73533-36-5	Intentional addition / 1%	chemical products
16046	Sulfurous acid, zinc salt (1:1), reaction products with formaldehyde	73545-12-7	Intentional addition / 2%	chemical products
16047	[4-hydroxymercuro]benzenesulfonic acid sodium	73548-15-9	Intentional addition / 1,000ppm	chemical products
16048	Copper, [29H,31H-phthalocyaninemetatetraethyl tetrachloridato(2-)]-, N29,N30,N31,N32]-, reaction products with N-cyclohexyl-1,3-propanediamine	73559-41-8	Intentional addition / 1,000ppm	chemical products
16049	Chromate(2-), [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-[N-[7-hydroxy-8-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenyl]acetamidato(2-)]-, disodium	73559-51-0	Contains (regardless of intentional or impurities)	chemical products
16050	Chromate(2-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-, disodium	73559-52-1	Contains (regardless of intentional or impurities)	chemical products
16051	Phenol, heptyl-, barium salt	73598-35-3	Contains (regardless of intentional or impurities)	chemical products
16052	Benzenesulfonic acid, 5-chloro-4-ethyl-2-[[4-hydroxy-1-naphthalenyl]azo]-, barium salt (2:1)	73612-30-3	Contains (regardless of intentional or impurities)	chemical products
16053	2-Naphthalenesulfonic acid, 6-[[2-hydroxy-1-naphthalenyl]azo]-, calcium salt (2:1)	73612-32-5	Intentional addition / 1,000ppm	chemical products
16054	Benzenesulfonic acid, 4-chloro-2-[[2-hydroxy-1-naphthalenyl]azo]-5-methyl-, barium salt (2:1)	73612-34-7	Contains (regardless of intentional or impurities)	chemical products
16055	2-Naphthalenesulfonic acid, 1-[[4-hydroxy-1-naphthalenyl]azo]-, barium salt (2:1)	73612-35-8	Contains (regardless of intentional or impurities)	chemical products
16056	2-Naphthalenesulfonic acid, 6-[[2-hydroxy-1-naphthalenyl]azo]-, barium salt (2:1)	73612-37-0	Contains (regardless of intentional or impurities)	chemical products
16057	1,5-Naphthalenedisulfonic acid, 2-[[4-hydroxy-1-naphthalenyl]azo]-, barium salt (1:1)	73612-38-1	Contains (regardless of intentional or impurities)	chemical products
16058	1-Naphthalenesulfonic acid, 2-[[4-hydroxy-1-naphthalenyl]azo]-, barium salt (2:1)	73612-39-2	Contains (regardless of intentional or impurities)	chemical products
16059	Cobaltate(1-), bis[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, sodium	73612-40-5	Intentional addition / 1,000ppm	chemical products
16060	Cobaltate(3-), bis[2-[[[3-[[1-[[2-chlorophenyl]amino]carbonyl]-2-oxopropyl]azo]-4-hydroxyphenyl]sulfonyl]amino]benzoato(3-)]-, trisodium	73612-41-6	Intentional addition / 1,000ppm	chemical products
16061	Disodium cupric ethylenediaminetetraacetate trihydrate	73637-19-1	Intentional addition / 1,000ppm	chemical products
16062	Disodium manganese ethylenediaminetetraacetate dihydrate	73637-20-4	Contains (regardless of intentional or impurities)	chemical products
16063	Zinc fluoride hydrate	73640-07-0	Contains (regardless of intentional or impurities)	chemical products
16064	Cuprate(3-), [C-[[[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-2-sulphophenyl]amino]sulfonyl]-C-(aminosulfonyl)-29H,31H-phthalocyanine-C,C-disulfonato(5-)]-, N29,N30,N31,N32]-, trisodium	73650-11-0	Intentional addition / 1,000ppm	chemical products
16065	2,2(or 4)-Dichloro-3-pentanone	73651-50-0	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16066	Extract residues, coal, tar oil alkaline, naphthalene distillation residues	73665-18-6	Contains (regardless of intentional or impurities)	chemical products
16067	Benzyltriethylammonium pentachlorophenate	73680-69-0	Contains (regardless of intentional or impurities)	chemical products
16068	4-(4-Dimethylaminophenylazo)phenylarsonic acid hydrochloride	73688-85-4	Intentional addition / 1%	chemical products
16069	Ferrate(1-), [[N,N-(1-methyl-1,2-ethanediv)bis[N-(carboxymethyl)glycinate]]	73690-83-2	Intentional addition / 1%	chemical products
16070	Strychnine conjugate acid	73732-52-2	Contains (regardless of intentional or impurities)	chemical products
16071	Picric acid, sodium salt, hydrate	73771-13-8	Contains (regardless of intentional or impurities)	chemical products
16072	1H-Imidazole, 1-[2-(2,4-dichlorophenyl)-2-(2-propenyloxy)ethyl]-, (±)-	73790-28-0	Intentional addition / 100ppm	chemical products
16073	L-Tyrosine, N-acetyl-, alpha-(hydroxymethyl)-3-methoxy-O-methyl-, compound with strychnidin-10-one (1:1)	73800-74-5	Contains (regardless of intentional or impurities)	chemical products
16074	D-Tyrosine, N-acetyl-, alpha-(hydroxymethyl)-3-methoxy-O-methyl-, compound with strychnidin-10-one (1:1)	73800-76-7	Contains (regardless of intentional or impurities)	chemical products
16075	1-Acetoxydecylpentane carbonitrile	73825-69-1	Intentional addition	chemical products
16076	Pentabarium bis(triphosphate)	73830-73-6	Intentional addition / 1,000ppm	chemical products
16077	Cuprate(2-), [21-carboxy-9-ethenyl-14-ethyl-13-formyl-4,8,18-trimethyl-20-oxo-3-phorbinepropanoate(4-)-N23,N24,N25,N26]-, disodium, [SP-4-2-[3S-(3.alpha.4.beta.21.beta.)]-	73836-75-6	Intentional addition / 1,000ppm	chemical products
16078	2,6-Dichlorophenylboronic acid	73852-17-2	Intentional addition / 1%	chemical products
16079	3,5-Bis(trifluoromethyl)phenylboronic acid (contains varying amounts of anhydride)	73852-19-4	Intentional addition / 1%	chemical products
16080	4-Iodobenzeneboronic acid pinacol ester	73852-88-7	Intentional addition / 1%	chemical products
16081	1,2-Hexene, 1-bromo-, (E)-	73881-10-4	Intentional addition / 1,000ppm	chemical products
16082	Phenol, 2,2'-sulfonylbis[4-(1-methyl-1-phenylethyl)-, nickel(2+) salt (1:1)]	73882-06-1	Contains (regardless of intentional or impurities)	chemical products
16083	Phenol, 2,2'-sulfonylbis[4-nonyl-, nickel(2+) salt (1:1)]	73882-10-7	Contains (regardless of intentional or impurities)	chemical products
16084	Antimony oxide (Sb2O3), solid solution with nickel oxide (NiO) and titanium oxide (TiO2)	73892-02-1	Contains (regardless of intentional or impurities)	chemical products
16085	4-(2,3-Epoxypropoxy)-2-indole carbonitrile	73907-82-1	Intentional addition	chemical products
16086	Molybdenum vanadium oxide (Mo3VO11)	73912-43-3	Intentional addition / 1,000ppm	chemical products
16087	Manganese dichloride hydrate	73913-06-1	Contains (regardless of intentional or impurities)	chemical products
16088	Triethyltin bromide-2-pipecoline	73926-90-6	Contains (regardless of intentional or impurities)	chemical products
16089	Stannane, butyltris(dibutylidithiocarbamoyloxy)-	73927-88-5	Contains (regardless of intentional or impurities)	chemical products
16090	Propanenitrile, 3-oxo-3-(triphenylstannyloxy)-	73927-89-6	Contains (regardless of intentional or impurities)	chemical products
16091	Tributyltin iodoacetate	73927-91-0	Contains (regardless of intentional or impurities)	chemical products
16092	Tripolytin iodoacetate	73927-92-1	Contains (regardless of intentional or impurities)	chemical products
16093	tributyltin o-iodobenzoate	73927-93-2	Contains (regardless of intentional or impurities)	chemical products
16094	Tripolytin o-iodobenzoate	73927-94-3	Contains (regardless of intentional or impurities)	chemical products
16095	Tributyltin beta-iodopropionate	73927-95-4	Contains (regardless of intentional or impurities)	chemical products
16096	Tributyltin isooctylthioacetate	73927-97-6	Contains (regardless of intentional or impurities)	chemical products
16097	Tributyltin(2,4,5-trichlorophenoxy)stannane	73927-98-7	Contains (regardless of intentional or impurities)	chemical products
16098	Tripolytin trichloroacetate	73927-99-8	Contains (regardless of intentional or impurities)	chemical products
16099	Stannane, ((1,4-dioxo-2-butylene-1,4-diyloxy)bis(triphenyl)-	73940-87-1	Contains (regardless of intentional or impurities)	chemical products
16100	Tributyltin p-iodobenzoate	73940-88-2	Contains (regardless of intentional or impurities)	chemical products
16101	Tributyltin alpha-(2,4,5-trichlorophenoxy) propionate	73940-89-3	Contains (regardless of intentional or impurities)	chemical products
16102	Imidazole, 2,4,5-tribromo-, cadmium salt	73941-35-2	Contains (regardless of intentional or impurities)	chemical products
16103	Nickel cyanide (Ni(CN)2)	73963-97-0	Intentional addition / 1,000ppm	chemical products
16104	Dipentylamine, tetrafluoroborate(1-)	73987-15-2	Intentional addition / 1%	chemical products
16105	Oxybis(dibutyl(2,4,5-trichlorophenoxy)tin)	74007-80-0	Contains (regardless of intentional or impurities)	chemical products
16106	Selenium dichlorobis(2-ethoxyethyl)oxy-	74037-18-6	Contains (regardless of intentional or impurities)	chemical products
16107	Propanoic acid, 2-hydroxy-, manganese(2+) salt (2:1)	74051-88-0	Contains (regardless of intentional or impurities)	chemical products
16108	Chromate(4-), [4-hydroxy-3-[(2-hydroxy-5-nitro-3-sulfonyl)azo]-6-[[sulfomethylamino]-2-naphthalenesulfonato(5-)]-1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, tetrahydrogen	74051-91-5	Contains (regardless of intentional or impurities)	chemical products
16109	Tris(5-oxo-L-prolinate-N1,O2)trium	74060-54-1	Intentional addition / 1%	chemical products
16110	Chromate(4-), [4-hydroxy-3-[(2-hydroxy-5-nitro-3-sulfonyl)azo]-6-[[sulfomethylamino]-2-naphthalenesulfonato(5-)]-1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, tetrahydrogen, compound with 2,2'-iminobis[ethano](1:4)	74063-47-1	Contains (regardless of intentional or impurities)	chemical products
16111	Tridecanoic acid, copper(2+) salt	74077-29-5	Intentional addition / 1,000ppm	chemical products
16112	Copper, [mu-(4,4'-bis[[2,3,5-tris(1,1-dimethylethyl)-6-hydroxyphenyl]azo][1,1'-biphenyl]-3,3'-diolato(4-))]di-	74082-14-7	Intentional addition / 1,000ppm	chemical products
16113	Cobaltate(1-), bis[2-[4-[(5-chloro-2-hydroxyphenyl)azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, sodium	74082-15-8	Intentional addition / 1,000ppm	chemical products
16114	Chromate(2-), [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]N-[7-hydroxy-8-[(2-hydroxy-4-nitrophenyl)azo]-1-naphthalenyl]acetamidato(2-)]-, disodium	74082-16-9	Contains (regardless of intentional or impurities)	chemical products
16115	Butanedioic acid, hydroxy-, barium salt (1:1), (±)-	74096-75-6	Intentional addition / 1,000ppm	chemical products
16116	Barium di(ethanesulphonate)	74113-46-5	Contains (regardless of intentional or impurities)	chemical products
16117	Manganese nitride (Mn3N)	74114-36-6	Intentional addition / 1%	chemical products
16118	Clofentazine	74115-24-5	Intentional addition / 1%	chemical products
16119	D-Gluconic acid, 6-(dihydrogen phosphate), barium salt	74129-00-3	Intentional addition	chemical products
16120	Tetradecyl 4-octyl-7-oxo-4-[[2-oxo-2-(tetradecyloxy)ethyl]thio]-8-oxa-3,5-dithia-4-stannadocosanoate	74162-83-7	Contains (regardless of intentional or impurities)	chemical products
16121	Zinc dichloride 5/2 hydrate	74173-38-9	Intentional addition / 1%	chemical products
16122	Trichloro(triethylamine)boron	74174-50-8	Intentional addition / 1%	chemical products
16123	Dipotassium [[N,N-ethylenebis[N-(carboxymethyl)glycinate]](4-)-N,N,O,O,ON,ON]cuprate(2-)	74181-84-3	Intentional addition / 1,000ppm	chemical products
16124	Zinc chloride, trihydrate	74182-35-7	Intentional addition / 1,000ppm	chemical products
16125	Diammonium nickel hexacyanoferrate	74195-78-1	Contains (regardless of intentional or impurities)	chemical products
16126	Cobaltate(3-), bis[3-hydroxy-7-nitro-4-[(1,2,3,4-tetrahydro-2,4-dioxo-3-quinolinyl)azo]-1-naphthalenesulfonato(3-)]-, trisodium	74196-11-5	Intentional addition / 1,000ppm	chemical products
16127	Cobaltate(5-), bis[6-[(5-chloro-2,6-difluoro-4-pyrimidinylamino)-4-hydroxy-3-[(2-hydroxy-5-nitro-3-sulfonyl)azo]-2-naphthalenesulfonato(4-)]-tetrapotassium sodium	74196-12-6	Intentional addition / 1,000ppm	chemical products
16128	Cobaltate(5-), bis[7-hydroxy-8-[(2-hydroxy-5-nitro-3-sulfonyl)azo]-6-[[2,5,6-trichloro-4-pyrimidinylamino]-2-naphthalenesulfonato(4-)]-, pentasodium	74196-13-7	Intentional addition / 1,000ppm	chemical products
16129	Ferrate(9-), bis[3-[[2-amino-5-hydroxy-6-[(2-hydroxy-5-nitro-3-sulfonyl)azo]-7-sulfo-1-naphthalenyl]azo]-2-hydroxy-5-sulfobenzoato(6-)]-, nonasodium	74196-14-8	Intentional addition / 1%	chemical products
16130	Chromate(5-), bis[2,4-dihydroxy-5-[(2-hydroxy-3-nitro-5-sulfonyl)azo]benzoato(4-)]-, pentasodium	74196-15-9	Contains (regardless of intentional or impurities)	chemical products
16131	Chromate(3-), bis[4-amino-3-[(2-hydroxy-3,5-dinitrophenyl)azo]-1-naphthalenesulfonato(3-)]-, trisodium	74196-16-0	Contains (regardless of intentional or impurities)	chemical products
16132	Chromate(5-), bis[3-[[2,4-diamino-5-[(4-sulfonyl)azo]phenyl]azo]-2-hydroxy-5-nitrobenzenesulfonato(4-)]-, pentasodium	74196-17-1	Contains (regardless of intentional or impurities)	chemical products
16133	Cobaltate(7-), bis[4-hydroxy-5-[(2-hydroxy-1-naphthalenyl)azo]-3-[(2-hydroxy-3-nitro-5-sulfonyl)azo]-2,7-naphthalenedisulfonato(5-)]-, heptasodium	74196-18-2	Intentional addition / 1,000ppm	chemical products
16134	Cobaltate(5-), bis[4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-5-[[2,5,6-trichloro-4-pyrimidinylamino]-2,7-naphthalenedisulfonato(4-)]-, pentasodium	74196-19-3	Intentional addition / 1,000ppm	chemical products
16135	Ferrate(2-), [2-[[4-[[2,6-dihydroxy-3-[(2-hydroxy-3,5-dinitrophenyl)azo]phenyl]azo]phenylamino]-5-nitrobenzenesulfonato(3-)]-4-[[2-hydroxy-3,5-dinitrophenyl]azo]-1,3-benzenediolato(2-)]-, ammonium sodium	74204-29-8	Intentional addition / 1%	chemical products
16136	C.I. Reactive Blue 52	74204-30-1	Intentional addition / 1,000ppm	chemical products
16137	Dibromoformaldehydeoxime	74213-24-4	Contains (regardless of intentional or impurities)	chemical products
16138	Nonane, 2-bromo-, (S)-	74219-10-6	Intentional addition / 1,000ppm	chemical products
16139	Dipotassium O,O'-(4,4'-diaminobiphenyl-3,3'-ylene)diglycolate	74220-10-3	Intentional addition / 1,000ppm	chemical products
16140	Trisodium bis(amino)[2-hydroxy-3,5-dinitrophenyl]azo[naphthalenesulphonato(3-)]cobaltate(3-)	74220-71-6	Intentional addition / 1,000ppm	chemical products
16141	Sulfometuron-methyl	74222-97-2	Intentional addition / 1%	chemical products
16142	3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,12,12,12-tetracosafuoro-11-(trifluoromethyl)dodecyl methacrylate	74256-14-7	Intentional addition / 100ppm	chemical products
16143	3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,14,14-Tetracosafuoro-13-(trifluoromethyl)tetradecyl methacrylate	74256-15-8	Intentional addition / 100ppm	chemical products
16144	Barium bis(cytidine 2',3'-phosphate)	74263-38-0	Contains (regardless of intentional or impurities)	chemical products
16145	1,3-Benzenediamine, 4-methyl-, hydrochloride	74283-35-5	Intentional addition / 25%	chemical products
16146	1,3-Benzenediamine, 4-methyl-, sulfate	74283-36-6	Intentional addition / 25%	chemical products
16147	(5R,6S)-6-[(1R)-1-Hydroxyethyl]-3,7-dioxo-1-azabicyclo[3.2.0]heptane-2-carboxylic acid, 4-nitrobenzene	74288-40-7	Contains (regardless of intentional or impurities)	chemical products
16148	Chromium, 4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamide 4-hydroxy-5-[[2-oxo-1-(phenylamino)carbonyl]propyl]azo]-1,3-benzenedisulfonate sodium complexes	74313-68-1	Intentional addition / 1,000ppm	chemical products
16149	Butene, homopolymer, phosphosulfurized, barium salts, overbased	74313-73-8	Intentional addition / 1,000ppm	chemical products
16150	Molybdenum titanium oxide (MoTiO5), hydrate	74316-36-2	Intentional addition / 1,000ppm	chemical products
16151	3,3'-Dichlorobenzidine sulphate	74332-73-3	Contains (regardless of intentional or impurities)	chemical products
16152	9,10-Anthracenedione, 1-[[5,7-dichloro-1,9-dihydro-2-methyl-9-oxopyrazolo[5,1-b]quinazolin-3-yl]azo]-	74336-60-0	Intentional addition / 100ppm	chemical products
16153	Chromate(1-), [4-[(6-amino-1-hydroxy-3-sulfo-2-naphthalenyl)azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, hydrogen	74354-92-0	Contains (regardless of intentional or impurities)	chemical products
16154	Iron abietate	74356-11-9	Intentional addition / 1%	chemical products
16155	Chromium, [2-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]-5-nitrobenzenesulfonato(3-)]-	74358-83-1	Intentional addition / 1,000ppm	chemical products
16156	Nickelate(2-), [[N,N-1,2-ethanediv]bis[L-aspartato]](4-)]-, dihydrogen, (OC-6-13-A)-	74365-18-7	Contains (regardless of intentional or impurities)	chemical products
16157	Antimonate(2-), bis[mu-[2,3-dihydroxybutanedioato(4-)-O1,O2,O3,O4]]di-, disodium, stereoisomer	74365-27-8	Intentional addition / 1,000ppm	chemical products
16158	1-Butene, 4-bromo-3,3,4,4-tetrafluoro-, polymer with 1,1-difluoroethene, 1,1,2,3,3,3-hexafluoro-1-propene and tetrafluoroethene	74398-72-4	Intentional addition / 1,000ppm	chemical products
16159	1-Phenanthrenecarboxylic acid, 1,2,3,4,4a,4b,5,6,10,10a-decahydro-1,4a-dimethyl-7-(1-methylethyl)-, nickel salt, [1R-(1.alpha.,4a.beta.,4b.alpha.,10a.alpha.)]-	74399-84-1	Contains (regardless of intentional or impurities)	chemical products
16160	Cuprate(2-), [4-hydroxy-3-[(2-hydroxy-4-nitrophenyl)azo]-6-[[3-sulfonyl]amino]-2-naphthalenesulfonato(4-)]-, dihydrogen	74404-49-2	Intentional addition / 1,000ppm	chemical products
16161	Chromate(3-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, trihydrogen, compound with 3-[[2-ethylhexyloxy]-1-propanamine (1:1)]	74411-37-3	Contains (regardless of intentional or impurities)	chemical products
16162	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[2-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]-, hydrogen, compound with 3-[[2-ethylhexyloxy]-1-propanamine (1:1)]	74411-39-5	Contains (regardless of intentional or impurities)	chemical products
16163	Chromate(1-), bis[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, hydrogen, compound with N-cyclohexylcyclohexanamine (1:1)	74421-71-9	Contains (regardless of intentional or impurities)	chemical products
16164	[3-[[4,5-Dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulphonato(3-)]chromium	74426-82-7	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16165	Octahydrogen [29H,31H-phthalocyanine-2,3,9,10,16,17,23,24-octacarboxylato(10)-N29,N30,N31,N32]cobaltate(8-)	74427-91-1	Intentional addition / 1%	chemical products
16166	Tetrasodium [mu-[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[4-hydroxy-6-(3-sulphoanilino)naphthalene-2-sulphonato]](8-)]dicuprate(4-)	74432-30-7	Intentional addition / 1,000ppm	chemical products
16167	Boron carbide (B12C)	74434-12-1	Intentional addition / 1%	chemical products
16168	Iron trisulphate	74449-50-6	Intentional addition / 1%	chemical products
16169	Trisodium [[2-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]ethyl]amino]sulphonyl]-29H,31H-phthalocyaninetrissulphonato(5-)-N29,N30,N31,N32]cuprate(3-)	74449-65-3	Intentional addition / 1,000ppm	chemical products
16170	C.I. Reactive Blue 15	74449-66-4	Intentional addition / 1,000ppm	chemical products
16171	Saponaria	74499-23-3	Contains (regardless of intentional or impurities)	chemical products
16172	Cobaltate(1-), [3-[[[4-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamidato(2-)]N-[[1,7-hydroxy-8-[[2-hydroxy-5-[[methylamino]sulfonyl]phenyl]azo]-1-naphthalenyl]acetamidato(2-)]]-, sodium	74499-63-1	Intentional addition / 1,000ppm	chemical products
16173	Naphtholene, decamethyl-	74507-60-1	Intentional addition / 1%	chemical products
16174	Tin(4+) acrylate	74512-59-7	Contains (regardless of intentional or impurities)	chemical products
16175	Lithium triethyl(2H)hydroborate(1-)	74540-86-6	Intentional addition / 1%	chemical products
16176	Tin dilinolate	74563-66-9	Contains (regardless of intentional or impurities)	chemical products
16177	Trihydrogen [[[(3-amino-4-sulphophenyl)amino]sulphonyl]sulphamoyl]-29H,31H-phthalocyaninedisulphonato(5-)-N29,N30,N31,N32]cuprate(3-)	74577-19-8	Intentional addition / 1,000ppm	chemical products
16178	Styrylchloride	74577-96-1	Contains (regardless of intentional or impurities)	chemical products
16179	Tetrahydrogen [3-[[9-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-3,6-disulpho-2-naphthyl]azo]-4-hydroxynaphthalene-1,5-disulphonato(6-)]cuprate(4-)	74587-42-1	Intentional addition / 1,000ppm	chemical products
16180	3,5,5-Trimethylhexyl 2,4,5-trichlorophenoxyacetate	74592-86-8	Intentional addition / 1,000ppm	chemical products
16181	Cuprate(4-), [mu-[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulphonato]](8-)]bis(morpholine-N4)di-, tetraammonium	74592-98-6	Intentional addition / 1,000ppm	chemical products
16182	Cuprate(4-), [mu-[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulphonato]](8-)]bis[2,2'-iminobis[ethano]-N,O,O']di-, lithium trisodium	74592-99-7	Intentional addition / 1,000ppm	chemical products
16183	Cuprate(4-), [mu-[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulphonato]](8-)]bis[2,2'-iminobis[ethano]-N,O,O']di-, dilithium disodium	74593-00-3	Intentional addition / 1,000ppm	chemical products
16184	Cuprate(4-), [mu-[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulphonato]](8-)]bis[2,2'-iminobis[ethano]-N,O,O']di-, trithium sodium	74593-01-4	Intentional addition / 1,000ppm	chemical products
16185	Copper, [N,N,N',N'-tetrakis[2-(2,5-dihydroxyphenyl)-1-methyl]ethyl]-29H,31H-phthalocyanine-2,9,16,23-tetrasulfonamidato(2-)-N29,N30,N31,N32]-, (SP-4-1)-	74610-56-3	Intentional addition / 1,000ppm	chemical products
16186	Hexanoic acid, 2-ethyl-, vanadium salt	74630-99-2	Intentional addition / 1%	chemical products
16187	Cuprate(2-), [C,C-bis(amino)sulfonyl]-29H,31H-phthalocyanine-C,C-disulphonato(4-)-N29,N30,N31,N32]-, lithium sodium	74642-98-1	Intentional addition / 1,000ppm	chemical products
16188	Trinickel bis(arsenite)	74646-29-0	Contains (regardless of intentional or impurities)	chemical products
16189	Trisodium [3-[[4-[[6-anilino-1-hydroxy-4-sulpho-2-naphthyl]azo]-5-hydroxy-o-tyl]azo]naphthalene-1,5-disulphonato(5-)]cuprate(3-)	74664-50-9	Intentional addition / 1,000ppm	chemical products
16190	Spinel, aluminum chromium cobalt zinc blue	74665-01-3	Contains (regardless of intentional or impurities)	chemical products
16191	Manganese, borate naphthalene neodecanoate complexes	74665-10-4	Contains (regardless of intentional or impurities)	chemical products
16192	Cuprate(6-), [mu-[[3,3'-[[iminobis[1-hydroxy-3-sulfo-6,2-naphthalenediyl]azo(5-hydroxy-2-methyl-4,1-phenylene)azo]]bis[1,5-naphthalenedisulphonato]](10-)]di-, hexasodium	74685-92-0	Intentional addition / 1,000ppm	chemical products
16193	[29H,31H-Phthalocyaninetrissulphonamidato(2-)-N29,N30,N31,N32]copper	74708-59-1	Intentional addition / 1,000ppm	chemical products
16194	Zincium, butoxytris[2,4-pentanedionato-O,O']-	74751-86-3	Contains (regardless of intentional or impurities)	chemical products
16195	4,4'-Bi-o-tolidine sulphate	74753-18-7	Contains (regardless of intentional or impurities)	chemical products
16196	Plumbate(2-), [[N,N'-1,2-ethanediy]bis[N-[[carboxy-kappa.O)methyl]glycinato-kappa.N,kappa.O]](4-)]-, dihydrogen, (OC-6-21)-	74765-09-6	Intentional addition / 1,000ppm	chemical products
16197	[Cyclohexane-1,1-diy]bis(methylamino)-N,N']sulphato(2-)-O,O']platinum	74790-08-2	Contains (regardless of intentional or impurities)	chemical products
16198	Lubricating greases	74869-21-9	Contains (regardless of intentional or impurities)	chemical products
16199	Lubricating oils	74869-22-0	Contains (regardless of intentional or impurities)	chemical products
16200	Europium fluoroborate	74912-23-5	Intentional addition / 1,000ppm	chemical products
16201	4,5-Dihydro-5-oxo-1-(4-sulphophenyl)-4-[[4-sulphophenyl]azo]-1H-pyrazole-3-carboxylic acid, barium salt	74920-66-4	Contains (regardless of intentional or impurities)	chemical products
16202	Trisodium bis[6-amino-4-hydroxy-3-[[2-hydroxy-3,5-dinitrophenyl]azo]naphthalene-2-sulphonato(3-)]chromate(3-)	74920-95-9	Contains (regardless of intentional or impurities)	chemical products
16203	Tin silicofluoride	74925-56-7	Contains (regardless of intentional or impurities)	chemical products
16204	Tetrabromopentane	74925-62-5	Intentional addition / 1,000ppm	chemical products
16205	Chlorobromotrifluoroethane	74925-63-6	Intentional addition / 1,000ppm	chemical products
16206	Yttrium amidosulfate	74930-76-0	Intentional addition / 1%	chemical products
16207	5,9-Dibutyl-5,9-dichloro-7-hydroxy-6,8-dioxo-7-phospha-5,9-distannatridecane 7-oxide	74957-03-2	Contains (regardless of intentional or impurities)	chemical products
16208	Barium dibutylthiocarbamate	75032-78-9	Intentional addition / 1,000ppm	chemical products
16209	Barium octoacetoxystearate	75033-30-6	Intentional addition / 1,000ppm	chemical products
16210	Citrulline copper salt	75082-22-3	Intentional addition / 1,000ppm	chemical products
16211	Barium titanium oxide (BaTi2O4)	75095-11-3	Intentional addition	chemical products
16212	Cuprate(3-), [2-[[[3-(acetyl-amino)-2-hydroxy-5-sulphophenyl]azophenyl]methyl]azo]-5-sulfobenzoato(5-)]-, trihydrogen	75101-28-9	Intentional addition / 1,000ppm	chemical products
16213	1-Propanamin, N,N-dipropyl-, cobalt complex	75101-45-0	Intentional addition / 1,000ppm	chemical products
16214	Bis(tri-n-octyltin) maleate	75113-32-5	Contains (regardless of intentional or impurities)	chemical products
16215	Diocetyl tin bis(monomethoxybutyl maleate)	75113-34-7	Intentional addition / 1,000ppm	chemical products
16216	Tributyltin gluconate	75113-35-8	Contains (regardless of intentional or impurities)	chemical products
16217	Dibutyltin phosphate	75113-36-9	Contains (regardless of intentional or impurities)	chemical products
16218	Dibutyltin hydrogen borate	75113-37-0	Contains (regardless of intentional or impurities)	chemical products
16219	Di-n-octyltin sulfate	75113-38-1	Intentional addition / 1,000ppm	chemical products
16220	1,3,2,4-Dioxaphosphastannetane, 2-hydroxy-4,4-diocetyl-, 2-oxide	75113-40-5	Intentional addition / 1,000ppm	chemical products
16221	Di-n-octyltin bis (ethylene glycol mono-beta-mercaptoacetate)	75113-43-8	Intentional addition / 1,000ppm	chemical products
16222	10,13-sioxo-4,6-dithia-5-stannapentadecanoic acid, 5,5-dibutyl-9-oxo-, 2-butoxyethyl ester	75113-44-9	Intentional addition / 1,000ppm	chemical products
16223	Cuprate(2-), [N,N'-dicyano-N',N'-bis[2,4-[[2-(sulfooxy)ethyl]sulfonyl]phenyl]ethyl]-29H,31H-phthalocyanine-C,C,O,C-tetrasulfonamidato(4-)-N29,N30,N31,N32]-, dihydrogen	75125-62-1	Intentional addition / 1,000ppm	chemical products
16224	[R'-[R+-(Z,Z)]-1,1,3,3-tetrabutyl-1,3-bis[[1,2-hydroxy-1-oxooctadec-9-enyl]oxy]distannoxane	75149-37-0	Contains (regardless of intentional or impurities)	chemical products
16225	Ethyl acetate complex salt of dibutoxyzirconium	75149-95-0	Contains (regardless of intentional or impurities)	chemical products
16226	Cuprate(4-), [3-[[[3-[[4-bis[2-[[2-chloroethyl]sulfonyl]ethyl]amino]-6-chloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-3,6-disulfo-2-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulphonato(6-)]-, tetrahydrogen	75150-07-1	Intentional addition / 1,000ppm	chemical products
16227	Cuprate(3-), [4-amino-6-[[6-[[[4-[[2-chloroethyl]sulfonyl]methyl]benzoyl]amino]-2-hydroxy-4-sulfo-1-naphthalenyl]azo]-5-hydroxy-1,3-naphthalenedisulphonato(5-)]-, trihydrogen	75150-08-2	Intentional addition / 1,000ppm	chemical products
16228	Chromate(3-), bis[2-[[4-[[2,4-dihydroxy-3-[[2-hydroxy-3,5-dinitrophenyl]azo]phenyl]azo]phenyl]amino]-5-nitrobenzenesulfonato(3-)]-, trisodium	75150-09-3	Contains (regardless of intentional or impurities)	chemical products
16229	Cuprate(3-), [2-[[[2-hydroxy-3-sulfo-5-[[2-(sulfooxy)ethyl]sulfonyl]phenyl]azo]phenyl]methyl]azo]-5-sulfobenzoato(6-)]-, trihydrogen	75173-67-0	Intentional addition / 1,000ppm	chemical products
16230	Copper, [mu-[[3,3'-[azobis[[2-hydroxy-4,1-phenylene]azo]]bis[4-hydroxy-2,7-naphthalenedisulphonato]](8-)]di-, tetrasodium	75173-68-1	Intentional addition / 1,000ppm	chemical products
16231	Pentamethylcyclopentadienylniobium(V) trichloride	75181-08-7	Intentional addition / 1%	chemical products
16232	Chromate(1-), bis[1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]-, sodium	75199-03-0	Contains (regardless of intentional or impurities)	chemical products
16233	Chromate(1-), bis[2-(2-chlorophenyl)-2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]-, sodium	75199-04-1	Contains (regardless of intentional or impurities)	chemical products
16234	Chromate(2-), [2-(2-chlorophenyl)-2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)](2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, disodium	75199-05-2	Contains (regardless of intentional or impurities)	chemical products
16235	Chromate(3-), bis[2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, trisodium	75199-06-3	Contains (regardless of intentional or impurities)	chemical products
16236	Chromate(1-), bis[2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]-, sodium	75199-07-4	Contains (regardless of intentional or impurities)	chemical products
16237	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)](3-[[4,5-dihydro-3-methyl-1-(4-methylphenyl)-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]-, disodium	75199-08-5	Contains (regardless of intentional or impurities)	chemical products
16238	Cuprate(4-), [7-[[5-chloro-2-fluoro-6-methyl-4-pyrimidinyl]amino]-3-[[[2,8-dihydroxy-4,6-disulfo-1-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulphonato(6-)]-, tetrasodium	75199-09-6	Intentional addition / 1,000ppm	chemical products
16239	Cuprate(4-), [7-[[5-chloro-2-fluoro-6-methyl-4-pyrimidinyl]amino]-4-hydroxy-3-[[[2-hydroxy-4,6-disulfo-1-naphthalenyl]azo]-1,5-naphthalenedisulphonato(6-)]-, tetrasodium	75199-10-9	Intentional addition / 1,000ppm	chemical products
16240	Chromate(2-), [1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)](3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenedisulphonato(3-)]-, disodium	75214-56-1	Contains (regardless of intentional or impurities)	chemical products
16241	Chromate(3-), bis[3-[[4,5-dihydro-3-methyl-1-(4-methylphenyl)-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]-, trisodium	75214-57-2	Contains (regardless of intentional or impurities)	chemical products
16242	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenedisulphonato(3-)]-, trisodium	75214-58-3	Contains (regardless of intentional or impurities)	chemical products
16243	Cuprate(2-), [C-[[[3-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-sulphophenyl]amino]sulfonyl]-C,C-bis(amino)sulfonyl]-29H,31H-phthalocyanine-C-sulphonato(4-)-N29,N30,N31,N32]-, disodium	75214-59-4	Intentional addition / 1,000ppm	chemical products
16244	Cuprate(3-), [mu-[[[3-[[4-[[6-(benzoylamino)-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-8-hydroxy-1,6-naphthalenedisulphonato(7-)]]-, trisodium	75214-64-1	Intentional addition / 1,000ppm	chemical products
16245	Chromate(2-), [2,4-dinitro-6-[[2-(phenylamino)-1-naphthalenyl]azophenolato(2-)](3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenedisulphonato(3-)]-, disodium	75214-65-2	Contains (regardless of intentional or impurities)	chemical products
16246	Cuprate(4-), [5-[[4-chloro-6-[[4-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[[2-hydroxy-5-sulphophenyl]azo]-2,7-naphthalenedisulphonato(6-)]]-, tetrasodium	75214-66-3	Intentional addition / 1,000ppm	chemical products
16247	Cobaltate(1-), bis[3-[[[1-(2,5-dichlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]]-, sodium	75214-67-4	Intentional addition / 1,000ppm	chemical products
16248	Chromate(2-), bis[4-[[5-chloro-2-hydroxyphenyl]azo]naphth[2,1-d]-1,3-oxathiazol-5-ol 3,3-dioxidato(2-)]-, sodium	75214-68-5	Contains (regardless of intentional or impurities)	chemical products
16249	Chromate(1-), bis[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-N,N-dimethylbenzenesulfonamidato(2-)]-, sodium	75214-69-6	Contains (regardless of intentional or impurities)	chemical products
16250	Chromate(1-), bis[N-[[[5-(ethylsulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]methanesulfonamidato(2-)]-, sodium	75214-70-9	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16251	Cobaltate(5-), bis[4-[4-[[[4-[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfonylphenyl)-1H-pyrazol-4-yl]azo]-4-hydroxyphenyl]sulfonyl]amino]phenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonate(4-)-, pentasodium	75214-71-0	Intentional addition / 1,000ppm	chemical products
16252	Cobaltate(3-), bis[4-[4-[[[4-[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonate(3-)-], trisodium	75214-72-1	Intentional addition / 1,000ppm	chemical products
16253	Chromate(3-), bis[2-[[2,4-dihydroxy-3-[[2-methyl-4-sulfonylphenyl]azo]phenyl]azo]benzoato(3-)-], trisodium	75234-41-2	Contains (regardless of intentional or impurities)	chemical products
16254	Cobaltate(3-), bis[4-[4-[[[4-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxyphenyl]sulfonyl]amino]phenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonate(3-)-, trisodium	75234-42-3	Intentional addition / 1,000ppm	chemical products
16255	Copper, [N,N,N',N',N'',N''-hexaethyl-29H,31H-phthalocyanine-C,C,C-trimethanaminato(2-)-N29,N30,N31,N32]-, tris(dodecylbenzenesulfonate)	75247-18-6	Intentional addition / 1,000ppm	chemical products
16256	Chromate(1-), [7-amino-4-hydroxy-8-[[2-hydroxy-4-nitrophenyl]azo]-3-[[4-sulfonylphenyl]azo]-2-naphthalenesulfonate(4-)-], sodium	75268-74-5	Contains (regardless of intentional or impurities)	chemical products
16257	Chromate(5-), bis[4-[6-[[4-chloro-6-(phenylamino)-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonate(4-)-], pentasodium	75268-75-6	Contains (regardless of intentional or impurities)	chemical products
16258	Chromate(1-), bis[1-[[2-hydroxyphenyl]azo]-2-naphthalenato(2-)-], sodium	75268-76-7	Contains (regardless of intentional or impurities)	chemical products
16259	Cuprate(3-), [mu-7-[[[4-(acetyl-amino)-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-8-hydroxy-1,6-naphthalenedisulfonate(7-)]di-, trisodium	75268-77-8	Intentional addition / 1,000ppm	chemical products
16260	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-5-(phenylazo)phenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonate(3-)-], disodium	75268-78-9	Contains (regardless of intentional or impurities)	chemical products
16261	2-Chloro-6-fluorophenylacetoneitrile	75279-55-9	Contains (regardless of intentional or impurities)	chemical products
16262	Cuprate(3-), [mu-3-[[[4-(6-benzoylamino)-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-4,5-dihydroxy-2,7-naphthalenedisulfonate(7-)]di-, trisodium	75284-35-4	Intentional addition / 1,000ppm	chemical products
16263	Cobaltate(5-), bis[4-[[[4-chloro-6-(phenylamino)-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonate(4-)-], pentasodium	75284-36-5	Intentional addition / 1,000ppm	chemical products
16264	Cuprate(5-), [mu-2-[[[4-(2-[[[4-(6-benzoylamino)-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-sulfo-1-naphthalenyl]azo]-2-sulfonylphenyl]ethenyl]-3-sulfonylphenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulfo-2-naphthalenato(9-)]di-, pentasodium	75284-37-6	Intentional addition / 1,000ppm	chemical products
16265	2'-Bromo-1,1',2',2''terphenyl	75295-57-7	Intentional addition / 100ppm	chemical products
16266	Chromium, 2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamide N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]methanesulfonate sodium complexes	75300-72-0	Intentional addition / 1,000ppm	chemical products
16267	Chromium, 3-(4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamide N-[8-[[5-(ethylsulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]methanesulfonamide sodium complexes	75300-73-1	Intentional addition / 1,000ppm	chemical products
16268	Chromium, 3-(4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamide 4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamide N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]acetamide sodium complexes	75300-74-2	Intentional addition / 1,000ppm	chemical products
16269	Cobalt, 4-[4-[[[4-[[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxyphenyl]sulfonyl]amino]phenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonate 4-[4-[[[4-[[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfonylphenyl)-1H-pyrazol-4-yl]azo]-4-hydroxyphenyl]sulfonyl]amino]phenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonate sodium complexes	75300-75-3	Intentional addition / 1%	chemical products
16270	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl sulfo derivatives, ammonium sodium salts, compounds with 2-(diethylamino)ethanol	75300-76-4	Intentional addition / 1,000ppm	chemical products
16271	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [(2-hydroxyethyl)methylamino]sulfonyl sulfo [(2-sulfoxy)ethyl]sulfonyl]phenyl]amino]sulfonyl derivatives	75300-77-5	Intentional addition / 1,000ppm	chemical products
16272	Cobaltate(2-), [6-amino-5-[[2-hydroxy-4-nitrophenyl]azo]-N-methyl-2-naphthalenesulfonamidato(2-)]-[[6-amino-5-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenesulfonate(3-)-], disodium	75314-27-1	Intentional addition / 1,000ppm	chemical products
16273	Monomethyltin mercaptacetate	75319-87-8	Intentional addition / 1,000ppm	chemical products
16274	Silicic acid (H6Si2O7), cobalt(2+) magnesium salt (1:2:1)	75364-04-4	Intentional addition / 1%	chemical products
16275	Propane, 1,2,3-tribromo-1-fluoro-	75372-14-4	Contains (regardless of intentional or impurities)	chemical products
16276	1-Pentene, 5-bromo-3-methyl-, (S)-	75420-42-7	Intentional addition / 1,000ppm	chemical products
16277	1-Pentene, 5-bromo-3-methyl-, (R)-	75420-43-8	Intentional addition / 1,000ppm	chemical products
16278	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[2-[[4-chloro-6-[[2,5-disulfonyl]amino]-1,3,5-triazin-2-yl]amino]ethyl]amino]sulfonyl sulfo derivatives, sodium salts	75422-19-4	Intentional addition / 1,000ppm	chemical products
16279	C.I. Reactive Blue 190	75422-20-7	Intentional addition / 1,000ppm	chemical products
16280	2-Ethylhexyl 4-(3-butoxy-3-oxopropyl)-10-ethyl-4-[[2-[[2-ethylhexyloxy]-2-oxoethyl]thio]-7-oxo-8-oxa-3,5-dithia-4-stannatetradecanoate	75457-52-2	Contains (regardless of intentional or impurities)	chemical products
16281	3-Nonene, 1-bromo-4-methyl-, (E)-	75476-53-8	Intentional addition / 1,000ppm	chemical products
16282	Cuprate(1-), [3,4-bis[[[2-hydroxy-1-naphthalenyl]methylene]amino]benzoato(3-)-N3,N4,O3,O4]-, hydrogen	75508-34-8	Intentional addition / 1,000ppm	chemical products
16283	Barium bis(didodecyl phosphite)	75522-74-6	Intentional addition / 1,000ppm	chemical products
16284	Cobaltate(2-), bis[2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamidato(2-)-], disodium	75522-91-7	Intentional addition / 1,000ppm	chemical products
16285	Benzoic acid, 2-[[2-amino-6-[[4-[[5-[[2,5-disulfonyl]azo]-1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-3,3-dimethoxy[1,1'-biphenyl]-4-yl]azo]-5-hydroxy-7-sulfo-1-naphthalenyl]azo]-5-nitro-, tetrasodium salt	75522-93-9	Contains (regardless of intentional or impurities)	chemical products
16286	Benzoic acid, 2-[[2-amino-5-hydroxy-6-[[4-[[1-hydroxy-8-[[[4-methylphenyl]sulfonyl]amino]-3,6-disulfo-2-naphthalenyl]azo]-3,3-dimethoxy[1,1'-biphenyl]-4-yl]azo]-7-sulfo-1-naphthalenyl]azo]-5-nitro-, trisodium salt	75522-94-0	Contains (regardless of intentional or impurities)	chemical products
16287	Bis(dimethyl-3-oxopentanedioato-O1',O3)copper	75523-88-5	Intentional addition / 1,000ppm	chemical products
16288	Pentaboron lanthanum(3+) magnesium decaoxide	75529-20-3	Intentional addition / 1%	chemical products
16289	Pentaboron cerium magnesium decaoxide	75529-21-4	Intentional addition / 1%	chemical products
16290	Pentaboron gadolinium(3+) magnesium decaoxide	75529-26-9	Intentional addition / 1%	chemical products
16291	Pentaboron magnesium terbium(3+) decaoxide	75529-27-0	Intentional addition / 1%	chemical products
16292	Nonanoic acid, tin(2+) salt	75533-11-8	Intentional addition / 1,000ppm	chemical products
16293	Barium calcium magnesium strontium zinc oxide silicate	75535-28-3	Intentional addition	chemical products
16294	Cobaltate(2-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)-], lithium sodium, (OC-6-22)-	75557-21-0	Intentional addition / 1,000ppm	chemical products
16295	Platinate(1-), hydroxy[sulfato(2-)-O]-, hydrogen	75559-09-0	Contains (regardless of intentional or impurities)	chemical products
16296	Nickel, [[2-sulfonylbis[4-nonylphenolato]](2-)-O1,O1',O2]-	75559-55-6	Contains (regardless of intentional or impurities)	chemical products
16297	Phenazinium, 3-[[7-[[4-aminophenyl]amino]-5-phenylphenazinium-3-yl]amino]-5-phenyl-7-[[5-phenyl-7-(phenylamino)phenazinium-3-yl]amino]-, salt with chromic acid (H2CrO7) (2:3)	75578-75-6	Contains (regardless of intentional or impurities)	chemical products
16298	Nickel, [[2-sulfonylbis[4-(1-methyl-1-phenylethyl)phenolato]](2-)-O1,O1',O2]-	75578-87-9	Contains (regardless of intentional or impurities)	chemical products
16299	Chromium, [4-(4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonate(3-)-], compound with N-cyclohexylcyclohexanamine phosphate (1:1:1)	75601-78-4	Intentional addition / 1,000ppm	chemical products
16300	Xanthylum, 3,6-bis(ethylamino)-9-[[2-(methoxycarbonyl)phenyl]-2,7-dimethyl-, molybdatesilicate	75627-12-2	Intentional addition / 1,000ppm	chemical products
16301	2,7-Naphthalenedisulfonic acid, 3,3'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-, monolithium trisodium salt	75659-72-2	Intentional addition	chemical products
16302	2,7-Naphthalenedisulfonic acid, 3,3'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-, dilithium disodium salt	75659-73-3	Intentional addition	chemical products
16303	Chromate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-methylbenzenesulfonamidato(2-)-], ammonium sodium	75660-32-1	Contains (regardless of intentional or impurities)	chemical products
16304	1-Naphthalenesulfonic acid, 3,3'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[4-hydroxy-, dilithium salt	75673-34-6	Intentional addition	chemical products
16305	1-Naphthalenesulfonic acid, 3,3'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[4-hydroxy-, monolithium monosodium salt	75673-35-7	Intentional addition	chemical products
16306	DL-Alanine, N-(2,6-dimethylphenyl)-N-(methoxyacetyl)-, methyl ester, mixture with [[1,2-ethanediy]bis(carbamodithioato)](2-)]manganese and [[1,2-ethanediy]bis(carbamodithioato)](2-)]zinc	75701-74-5	Contains (regardless of intentional or impurities)	chemical products
16307	[4-(Aminomethyl)phenyl]boronic acid hydrochloride	75705-21-4	Intentional addition / 1%	chemical products
16308	2-Hexene, 1-bromo-3-methyl-, (E)-	75716-98-2	Intentional addition / 1,000ppm	chemical products
16309	2-Hexene, 1-bromo-3-methyl-, (Z)-	75716-99-3	Intentional addition / 1,000ppm	chemical products
16310	Chromate(1-), (formato-O)[2-hydroxy-3-[[[2-hydroxy-5-nitrophenyl]methylene]amino]-5-nitrobenzenesulfonate(3-)-], hydrogen, compound with 2-ethyl-1-hexanamine (1:1)	75718-03-5	Contains (regardless of intentional or impurities)	chemical products
16311	Copper(I) 2,4,6-trimethylbenzidine	75732-01-3	Intentional addition / 1,000ppm	chemical products
16312	Dichlorotetrakis(N-propyl-N-2-(2,4,6-trichlorophenoxy)ethyl)-1H-imidazole-1-carboxamide]manganese	75747-77-2	Contains (regardless of intentional or impurities)	chemical products
16313	1,2-Benzenedimethanamine, N,N,N',N'-tetramethyl-, diperchlorate	75749-77-8	Intentional addition / 1,000ppm	chemical products
16314	2,7-Naphthalenedisulfonic acid, 3,3'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-, lithium monosodium salt	75752-17-9	Intentional addition	chemical products
16315	Cobaltate(1-), bis[1-[[2-hydroxyphenyl]azo]-2-naphthalenato(2-)-], sodium	75752-30-6	Intentional addition / 1,000ppm	chemical products
16316	Siloxanes and Siloxenes, dimethyl, polymers with boron oxide (B2O3)	75763-29-8	Intentional addition / 1%	chemical products
16317	Chromium, 3-(4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamide 4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamide N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]methanesulfonamide sodium complexes	75790-67-9	Intentional addition / 1,000ppm	chemical products
16318	Tetrabromophthalic acid mixed esters with diethylene glycol and propylene glycol	75790-69-1	Intentional addition / 900ppm	chemical products
16319	[3-[[[5-(Dimethylamino)-1-naphthyl]sulphonyl]amino]phenyl]metaboric acid	75806-94-9	Intentional addition / 1%	chemical products
16320	Iron manganese oxide ((Fe,Mn)2O3)	75864-23-2	Contains (regardless of intentional or impurities)	chemical products
16321	Orthoboric acid, compound with 1,1'-iminodipropen-2-ol	75877-08-6	Intentional addition / 1%	chemical products
16322	C.I. Ingrain Blue 1	75881-23-1	Intentional addition / 1,000ppm	chemical products
16323	Poly(oxy-1,2-ethanediy), alpha, alpha', alpha''-borilydinetris(omega-methoxy-	75915-45-6	Intentional addition / 1%	chemical products
16324	Chromate(1-), bis[4-[[4-(ethylsulfonyl)-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)-], sodium	75920-34-2	Contains (regardless of intentional or impurities)	chemical products
16325	1,2-Disilene-3,4,5,6,7,8-hexathiacyclooctane (S6Se2)	75926-26-0	Contains (regardless of intentional or impurities)	chemical products
16326	Vinylboronic acid pinacol ester	75927-49-0	Intentional addition / 1%	chemical products
16327	3,6-Dibutoxy-1,2-benzene dicarbonitrile	75942-37-9	Intentional addition	chemical products
16328	C.I. Direct Green 8:1	76012-70-9	Intentional addition / 1,000ppm	chemical products
16329	Iron(2+) acrylate	76034-19-0	Intentional addition / 1%	chemical products
16330	Butanal, 2,2-dichloro-3-methyl-	76043-68-0	Intentional addition / 1%	chemical products
16331	Calcium bis(thioborate)	76092-58-5	Intentional addition / 1%	chemical products
16332	Magnesium di(thioborate)	76092-59-6	Intentional addition / 1%	chemical products
16333	Bismuth alloy, base, Bi 50, Pb 25, Cd 12, Sn 12 (L-PbBi50Sn12Cd12.5)	76093-98-6	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16334	Tin(2+) methacrylate	76148-13-5	Contains (regardless of intentional or impurities)	chemical products
16335	Strychnidin-10-one, compound with ethyl 2-[[3,5-dibromo-4-hydroxyphenyl](3,5-dibromo-4-oxo-2,5-cyclohexadien-1-ylidene)methyl]benzoate (1:1)	76201-36-0	Contains (regardless of intentional or impurities)	chemical products
16336	1-Pentene, 5-bromo-4,4-dimethyl-	76207-20-0	Intentional addition / 1,000ppm	chemical products
16337	Benzoazolium, 3-methyl-5-phenyl-2-[[3-(3-sulfobutyl)-2(3H)-benzoseleazolylidene)methyl]-1-butenyl]-, inner salt	76213-48-4	Contains (regardless of intentional or impurities)	chemical products
16338	1-Propanesulfonic acid, 3-hydroxy-, tin(2+) salt (2:1)	76214-87-4	Intentional addition / 1,000ppm	chemical products
16339	Bis[4,5,6,7-tetrachloro-3-imino-1-isoindolinone oximate-N2,O]nickel	76231-24-8	Contains (regardless of intentional or impurities)	chemical products
16340	Dichloro(dichlorophenyl)methylmethylenbenzene	76253-80-6	Contains (regardless of intentional or impurities)	chemical products
16341	4-Bromo-1-bromomethyl-2-fluorobenzene	76283-09-5	Intentional addition / 1,000ppm	chemical products
16342	Cuprate(3-), [3-[[[5-hydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-2-methylphenyl]azo]-1,5-naphthalenedisulfonato(5-)]-, trisodium	76359-37-0	Intentional addition / 1,000ppm	chemical products
16343	4-Dihydroxybenzyl-L-phenylalanine	76410-58-7	Intentional addition / 1%	chemical products
16344	Strychnidin-10-one, mono[[tetraphenylborate(1-)]-	76445-05-1	Contains (regardless of intentional or impurities)	chemical products
16345	[Bis(3-butoxy-3-oxopropyl)stannylene]bis(thioethylene) distearate	76461-84-2	Contains (regardless of intentional or impurities)	chemical products
16346	Silicic acid (H4SiO4), tetraethyl ester, polymer with bis(acetyloxy)dibutylstannane	76468-20-7	Contains (regardless of intentional or impurities)	chemical products
16347	Cupric oxalate	76494-22-9	Intentional addition / 1,000ppm	chemical products
16348	Hexachlorodifluoropropane	76564-99-3	Intentional addition	chemical products
16349	Quazalofop-ethyl	76578-14-8	Contains (regardless of intentional or impurities)	chemical products
16350	Dibenzo(b,e)(1,4)dioxin, 1,3,6,8-tetrabromo-	76584-71-9	Intentional addition / 100ppm	chemical products
16351	2-Naphthalenecarboxylic acid, 4-[(4-chloro-3-sulphophenyl)azo]-3-hydroxy-, barium salt (1:1)	76613-71-3	Contains (regardless of intentional or impurities)	chemical products
16352	Bis[N-(2-hydroxyethyl)-N-methylglycinate-N,O]nickel	76625-10-0	Contains (regardless of intentional or impurities)	chemical products
16353	Disodium [5-[[[anilincarbonyl)-2-oxopropyl]azo]-4-hydroxy-3-nitrobenzenesulfonato(3-)]-[2-[[2-hydroxy-5-nitrophenyl]azo]-3-oxo-N-phenylbutylamidato(2-)]cobaltate(2-)	76762-27-1	Intentional addition / 1,000ppm	chemical products
16354	trans-4-(4-n-Heptylcyclohexyl)-1-fluorobenzene	76802-59-0	Intentional addition / 1,000ppm	chemical products
16355	trans-4-(4-n-Pentylcyclohexyl)-1-fluorobenzene	76802-61-4	Intentional addition / 1,000ppm	chemical products
16356	1,1'-Biphenyl, 2,4,6-triethyl-	76804-33-6	Intentional addition / 1%	chemical products
16357	22-Tricosenoic acid, cadmium salt	76835-97-7	Contains (regardless of intentional or impurities)	chemical products
16358	2-Heptene, 1-bromo-2-methyl-	76853-13-9	Intentional addition / 1,000ppm	chemical products
16359	Borane, dichloro(1,1-dimethylethyl)-	76873-78-4	Intentional addition / 1%	chemical products
16360	Hydrogen chlorotrioxochromate(1-), compound with 2,2'-bipyridine (1:1)	76899-34-8	Contains (regardless of intentional or impurities)	chemical products
16361	Direct Brown 223	76930-14-8	Intentional addition / 1,000ppm	chemical products
16362	1,1,3-Trichloro-2-fluoropropane	76937-36-5	Intentional addition	chemical products
16363	3-Octene, 8-bromo-, (Z)-	76971-26-1	Intentional addition / 1,000ppm	chemical products
16364	Phosphonic acid, (1-hydroxyethylidene)di-, copper diammonium complex	77001-44-6	Intentional addition / 1,000ppm	chemical products
16365	Hydrogen [29H,31H-phthalocyaninesulfonato(3-)-N29,N30,N31,N32]cuprate(1-), compound with N,N'-di(o-tolyl)guanidine (1:1)	77097-86-0	Intentional addition / 1,000ppm	chemical products
16366	(RS)-alpha-Cyano-3-phenoxybenzyl-(1R,3R)-2,2-dimethyl-3-(2-methyl-1-propenyl)cyclopropanecarboxylate	77122-51-1	Intentional addition	chemical products
16367	alpha-Cyano-3-phenoxybenzyl 2,2-dimethyl-3-(2-methyl-1-propenyl)cyclopropanecarboxylate	77122-52-2	Intentional addition	chemical products
16368	Glufosinate ammonium	77182-82-2	Contains (regardless of intentional or impurities)	chemical products
16369	Benzenesulfonic acid, 4-methyl-, iron(3+) salt	77214-82-5	Contains (regardless of intentional or impurities)	chemical products
16370	1-Imidazolidineethanol	77215-47-5	Contains (regardless of intentional or impurities)	chemical products
16371	Chromate(2-), [2-[[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfonyl)pyrazol-4-yl]azo]benzoato(3-)]-[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, dihydrogen, compound with 2-aminoethanol (1:2)	77242-26-3	Contains (regardless of intentional or impurities)	chemical products
16372	Nickel bis[[didecyl (1,2-dicyano-1,2-ethenediyl)bis(carbamato)](2-)]-	77245-35-3	Contains (regardless of intentional or impurities)	chemical products
16373	Diammonium tetrabromoplatinate	77259-34-8	Contains (regardless of intentional or impurities)	chemical products
16374	Mono[hydrogen L-glutamato(2-)-N,O]iron	77280-84-3	Intentional addition / 1%	chemical products
16375	(OC-6-11)-Dimagnesium hexachlorocadmate dodecahydrate	77280-75-9	Intentional addition / 1,000ppm	chemical products
16376	1-(4-Chloro-1-methyl-1-butenyl)-4-fluorobenzene	77284-15-6	Intentional addition / 1,000ppm	chemical products
16377	Benzonitrile, 2-amino-6-fluoro-	77326-36-4	Intentional addition	chemical products
16378	Acetic acid, methoxy[(1-oxo-2-propenyl)amino]-, methyl ester	77402-03-0	Contains (regardless of intentional or impurities)	chemical products
16379	Methyl acrylamidoglycolate	77402-05-2	Contains (regardless of intentional or impurities)	chemical products
16380	Pyraclafos	77458-01-6	Intentional addition / 1%	chemical products
16381	1-Chloro-3-(4-chlorophenyl)hydrazono propanone	77458-54-9	Contains (regardless of intentional or impurities)	chemical products
16382	3-Phenoxyphthalonitrile	77474-62-5	Intentional addition	chemical products
16383	4-(Phenylthio)phthalonitrile	77474-63-6	Intentional addition	chemical products
16384	Chromate(1-), bis[2-(3-chlorophenyl)-2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with [1R-(1.alpha.,4.alpha.,10.alpha.)]-1,2,3,4,4a,9,10,10a-octahydro-1,4a-dimethyl-7-(1-methylethyl)-1-phenanthrenemethanamine (1:1)	77496-01-6	Contains (regardless of intentional or impurities)	chemical products
16385	5-Fluoro-2-methyl benzonitrile	77532-79-7	Intentional addition	chemical products
16386	Asbestos, actinolite	77536-66-4	Contains (regardless of intentional or impurities)	chemical products
16387	Anthophyllite, asbestiform	77536-67-5	Contains (regardless of intentional or impurities)	chemical products
16388	Tremolite	77536-68-6	Contains (regardless of intentional or impurities)	chemical products
16389	Cobaltate(3-), bis[6-amino-5-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenesulfonato(3-)]-, trisodium	77630-54-7	Intentional addition / 1,000ppm	chemical products
16390	Boron oxide	77704-21-3	Intentional addition / 1%	chemical products
16391	Trisodium [2-[[alpha-[[[3-amino-2-hydroxy-5-sulphophenyl]azo]benzyl]azo]-4-sulphobenzoato(5-)]cuprate(3-)]-	77743-24-9	Intentional addition / 1,000ppm	chemical products
16392	Boron oxide	77783-55-2	Intentional addition / 1%	chemical products
16393	Benzyltriethylammonium tetrafluoroborate	77794-93-5	Intentional addition / 1%	chemical products
16394	Orthoboric acid, compound with potassium fluoride (1:1)	77816-14-9	Contains (regardless of intentional or impurities)	chemical products
16395	Cuprate(3-), [2-[[[3-amino-2-(hydroxy-kappa.O)-5-sulfonyl]azo]-kappa.N2]phenylmethyl]azo-kappa.N1]-4-sulfobenzoato(5-)-kappa.O]-, trihydrogen	77840-01-8	Intentional addition / 1,000ppm	chemical products
16396	Chromium, triaqua[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-	77847-23-5	Intentional addition / 1,000ppm	chemical products
16397	Chromium, triaqua[4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-	77847-24-6	Intentional addition / 1,000ppm	chemical products
16398	4-Decene, 1-bromo-, (Z)-	77899-13-9	Intentional addition / 1,000ppm	chemical products
16399	Triacetoxystannane	77928-59-7	Contains (regardless of intentional or impurities)	chemical products
16400	1-Benzylpiperidine-4-acetonitrile	78056-67-4	Intentional addition	chemical products
16401	2,6-Dimethylphenylhydrazine hydrochloride	78157-43-4	Contains (regardless of intentional or impurities)	chemical products
16402	Pentane, 1,2,4,5-tetrabromo-	78181-01-8	Intentional addition / 1,000ppm	chemical products
16403	Cuprate(3-), [3-[[[4-[[[5-[[[2,3-dichloro-6-quinolonyl]carbonyl]methylamino]methyl]-2-sulfonyl]azo]-2-hydroxy-5-methylphenyl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(5-)]-, trisodium	78181-07-4	Intentional addition / 1,000ppm	chemical products
16404	Methyl (Z,Z,Z)-8-[[4-methoxy-1,4-dioxobut-2-enyl]oxy]-8-octyl-3,6,10-trioxo-2,7,9-trioxo-8-stannatrideca-4,11-dien-13-olate	78182-42-0	Contains (regardless of intentional or impurities)	chemical products
16405	3,3-dinitrobenzoic acid (metaerythro)ethyl	78198-10-4	Intentional addition / 1%	chemical products
16406	Boric acid (H3BO3), polymer with 1-butanol titanium(4+) salt, dichlorodimethylsilane, dichlorodiphenylsilane and diphenylsilanediol	78198-16-0	Intentional addition / 1%	chemical products
16407	Bis(ethylglycylpentadienyl)hafnium(IV) dichloride	78205-93-3	Intentional addition / 1%	chemical products
16408	Phosphonic acid, butyl-, tin(4+) salt (4:1)	78230-05-4	Intentional addition / 1,000ppm	chemical products
16409	Phosphonic acid, octyl-, tin(4+) salt (4:1)	78230-06-5	Intentional addition / 1,000ppm	chemical products
16410	Phenol, tetrapropylene-, barium salt, overbased	78330-15-1	Intentional addition / 1,000ppm	chemical products
16411	Alcohols, C11-14-iso-, C13-rich, ethoxylated	78330-21-9	Intentional addition / 1%	chemical products
16412	4-(Dimethylarsino)benzoic acid	78331-48-3	Intentional addition / 100ppm	chemical products
16413	Octonol	78413-87-3	Intentional addition / 1,000ppm	chemical products
16414	Milirone	78415-72-2	Intentional addition	chemical products
16415	4-Amino-3,5-dichlorobenzonitrile	78473-00-4	Intentional addition	chemical products
16416	Diazolidinyl urea	78491-02-8	Contains (regardless of intentional or impurities)	chemical products
16417	2-[2-(2,4-Dimethoxyanilino)vinyl]-1,3,3-trimethyl-3H-indolium bis[salicylate(2-)-O1,O2]borate(1-)	78527-98-7	Intentional addition / 1%	chemical products
16418	2-Oxranemethanamine, N,N'-(sulfonyl)-3,1-phenylene]bis[N-(2-oxiranylmethyl)-	78542-64-0	Contains (regardless of intentional or impurities)	chemical products
16419	Silane, trichloro(3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10-heptafluorodecyl)-	78560-44-8	Contains (regardless of intentional or impurities)	chemical products
16420	Hexythiazox	78587-05-0	Contains (regardless of intentional or impurities)	chemical products
16421	Chromate(1-), bis[4-[[4-(ethylsulfonyl)-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 1,6-hexanediamine (1:1)	78592-92-4	Contains (regardless of intentional or impurities)	chemical products
16422	Strychnine nitrate	78686-40-5	Contains (regardless of intentional or impurities)	chemical products
16423	Cuprate(4-), [2-[[[2-hydroxy-3-sulfo-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]phenylmethyl]azo]-4-sulfobenzoato(6-)]-, tetrapotassium	78709-73-6	Intentional addition / 1,000ppm	chemical products
16424	(E)-3-[p-(Bromomethyl)phenyl]ethyl acrylate	78712-67-1	Contains (regardless of intentional or impurities)	chemical products
16425	Ammonium manganese(II) carbamate (1:1:3)	78812-39-2	Contains (regardless of intentional or impurities)	chemical products
16426	Nonanoic acid, zirconium salt	78818-95-8	Contains (regardless of intentional or impurities)	chemical products
16427	Cuprate(3-), [2-[[[5-(ethenylsulfonyl)-2-hydroxy-3-sulfonyl]azo]phenylmethyl]azo]-5-sulfobenzoato(5-)]-, trisodium	78885-60-6	Intentional addition / 1,000ppm	chemical products
16428	1,2-Propanediol, 3,3'-[[dimethylstannylene]bis(thio)]bis-	78899-76-0	Contains (regardless of intentional or impurities)	chemical products
16429	(Z,Z)-6,8,8,8-Tetrabutyl-4,10,13-trioxo-5,7,9,14-tetraoxa-6,8-distannadocosa-2,11-dienoic acid, octyl ester	78917-85-8	Intentional addition / 1,000ppm	chemical products
16430	Hexane, 3-methyl-, (R)-	78918-91-9	Intentional addition / 1%	chemical products
16431	Bis(isopropyl 3-oxobutanoato-O1',O3)copper	78969-81-0	Intentional addition / 1,000ppm	chemical products
16432	Sodium permanganate monohydrate	79048-36-5	Contains (regardless of intentional or impurities)	chemical products
16433	Strychnidin-10-one, mono[[135-trans]-5,8,13,13a-tetrahydro-9,10-dimethoxy-8-oxo-6H-benzo[g]-1,3-benzodioxolo[5,6-a]quinolizine-13-carboxylate]	79055-72-4	Contains (regardless of intentional or impurities)	chemical products
16434	1-Phenanthrenecarboxylic acid, 1,2,3,4,4a,5b,8,10,10a-decahydro-1,4a-dimethyl-7-(1-methylethyl)-, vanadium salt, [1R-(1.alpha.,4.alpha.,4b.alpha.,10.alpha.)]	79072-81-4	Intentional addition / 1%	chemical products
16435	Strychnidin-10-one, mono[(6S-cis)-6.6a,11,14-tetrahydro-8,9-dimethoxy-14-oxo-12H-benzo[a]-1,3-benzodioxolo[4,5-b]quinoline-6-carboxylate]	79082-07-8	Contains (regardless of intentional or impurities)	chemical products
16436	Tetrahydrogen [[[(3-amino-4-sulphophenylamino)sulphonyl]-29H,31H-phthalocyaninetrisulphonato(6-)-N29,N30,N31,N32]nickelate(4-)]-	79102-62-8	Contains (regardless of intentional or impurities)	chemical products
16437	2'-Fluoro-5-nitroacetophenone	79110-05-7	Intentional addition / 1%	chemical products
16438	Bis(4-benzoyl-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato-O,O')(2,2,4,4-tetramethyl-7-oxa-3,20-diazadipiro[5.11.11.2]hencosan-21-one-O2)nickel	79121-51-0	Contains (regardless of intentional or impurities)	chemical products
16439	Chromate(2-), [1-[[[5-chloro-2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]][3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonato(3-)]-, disodium	79135-15-2	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16440	Iron(1+), bis[5-[[3-[4,5-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]phenyl]azo]-1'-[3-(dimethylamino)propyl]-1,2'-dihydro-6'-hydroxy-4'-methyl-2'-oxo-1,3'-bipyridiniumato(2-)]-, salt with 2-hydroxypropanoic acid (1:1), bis(2-hydroxypropanoate) (salt)	79135-18-5	Intentional addition / 1%	chemical products
16441	Iron(1+), bis[5-[[3-[4-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]phenyl]azo]-1'-[3-(dimethylamino)propyl]-1,2'-dihydro-6'-hydroxy-4'-methyl-2'-oxo-1,3'-bipyridiniumato(2-)]-, salt with 2-hydroxypropanoic acid (1:1), bis(2-hydroxypropanoate) (salt)	79135-21-0	Intentional addition / 1%	chemical products
16442	Iron(1+), bis[5-[[4-[4,5-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]phenyl]azo]-1'-[3-(dimethylamino)propyl]-1,2'-dihydro-6'-hydroxy-4'-methyl-2'-oxo-1,3'-bipyridiniumato(2-)]-, salt with 2-hydroxypropanoic acid (1:1), bis(2-hydroxypropanoate) (salt)	79135-24-3	Intentional addition / 1%	chemical products
16443	Iron(1+), bis[5-[[4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]phenyl]azo]-1'-[3-(dimethylamino)propyl]-1,2'-dihydro-6'-hydroxy-4'-methyl-2'-oxo-1,3'-bipyridiniumato(2-)]-, salt with 2-hydroxypropanoic acid (1:1), bis(2-hydroxypropanoate) (salt)	79135-27-6	Intentional addition / 1%	chemical products
16444	Trisodium bis[4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzene-1-sulphonato(3-)]cobaltate(3-)	79135-28-7	Intentional addition / 1,000ppm	chemical products
16445	Dihydrogen [mu-[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[7-[[4,6-bis[[3-(diethylamino)propyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-2-naphthalenesulfonato]](6-)]dicuprate(2-)	79135-29-8	Intentional addition / 1,000ppm	chemical products
16446	Cuprate(2-), [mu-[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[7-[[4,6-bis[[3-(diethylamino)propyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-2-naphthalenesulfonato]](6-)]di-, dihydrogen, diacetate (salt)	79135-30-1	Intentional addition / 1,000ppm	chemical products
16447	Copper(1+), [5-[[3-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]phenyl]azo]-1'-[3-(dimethylamino)propyl]-1,2'-dihydro-6'-hydroxy-4'-methyl-2'-oxo-1,3'-bipyridiniumato(2-)]-, salt with 2-hydroxypropanoic acid (1:2)	79152-56-0	Intentional addition / 1,000ppm	chemical products
16448	Cuprate(2-), [mu-[[7,7'-iminobis[3-[[4-[[4,6-bis[[3-(diethylamino)propyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxyphenyl]azo]-4-hydroxy-2-naphthalenesulfonato]](6-)]di-, dihydrogen, diacetate (salt)	79152-58-2	Intentional addition / 1,000ppm	chemical products
16449	1H-1,2,4-Triazolium, 5-[[4-(diethylamino)phenyl]azo]-1,4-dimethyl-, perchlorate	79203-22-8	Intentional addition / 1,000ppm	chemical products
16450	Bis(6-methylheptane-2,4-dionato-O)cobalt	79215-59-1	Intentional addition / 1,000ppm	chemical products
16451	2,3-Dihydro-3-oxo-5,6-diphenyl-4-pyridazinecarbonitrile	79225-55-1	Intentional addition	chemical products
16452	[1,4-Bis(diphenylphosphino)butane][1,5-cyclooctadiene]rhodium(II) tetrafluoroborate	79255-71-3	Intentional addition / 1%	chemical products
16453	3-(Dimethylamino)-7-(methylamino)phenothiazin-5-ium tetrafluoroborate	79288-94-1	Intentional addition / 1%	chemical products
16454	4-Methyltetrahydro-1,3-izobenzofurandione	79313-15-8	Intentional addition / 1%	chemical products
16455	Tetradecyl 4,4'-diocetyl-7'-oxo-8'-oxa-3,5'-dithia-4-stannadecanoate	79330-84-0	Contains (regardless of intentional or impurities)	chemical products
16456	Aluminum, triethyl-, reaction products with nickel(2+) bis(2-ethylhexanoate)	79357-65-6	Contains (regardless of intentional or impurities)	chemical products
16457	Copper alloy, dross	79357-67-8	Intentional addition / 1,000ppm	chemical products
16458	Copper alloy, Sn, dross	79357-68-9	Intentional addition / 1,000ppm	chemical products
16459	Tin alloy, Sn 99, Cu 0.7, eutectic, tin-coating wastes	79357-72-5	Contains (regardless of intentional or impurities)	chemical products
16460	Flue dust, copper alloy-casting	79357-78-1	Intentional addition / 1,000ppm	chemical products
16461	Scale, coating, copper alloy	79357-80-5	Intentional addition / 1,000ppm	chemical products
16462	Slimes and Sludges, brass-manufacturing	79357-81-6	Intentional addition / 1,000ppm	chemical products
16463	Waste solids, brass, plated	79357-83-8	Intentional addition / 1,000ppm	chemical products
16464	Sodium [3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]-1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphtholato(2-)]chromate(2-)	79371-81-6	Contains (regardless of intentional or impurities)	chemical products
16465	(E,E)-Tributyl[hexa-2,4-dienoxy]stannane	79403-36-4	Contains (regardless of intentional or impurities)	chemical products
16466	Diphenoxydimethylsilylene	79463-77-7	Contains (regardless of intentional or impurities)	chemical products
16467	Cadmium perchlorate hydrate	79490-00-9	Contains (regardless of intentional or impurities)	chemical products
16468	Dibromotin bis(2-methylpropyl)	79494-57-8	Intentional addition / 1,000ppm	chemical products
16469	Dihydrogen bis[N-(7-hydroxy-8-[[2-hydroxy-5-sulphamoyl]phenyl]azo)-1-naphthyl]acetamidato(2-)]chromate(1-)	79502-95-7	Contains (regardless of intentional or impurities)	chemical products
16470	Tefluthrin	79538-32-2	Contains (regardless of intentional or impurities)	chemical products
16471	Dodecabromoterephenyl	79596-31-9	Intentional addition / 100ppm	chemical products
16472	3-Chloro-N-(3-chloro-5-trifluoromethyl-2-pyridyl)-alpha, alpha, alpha-trifluoro-2,6-dinitro-p-toluidine	79622-59-6	Contains (regardless of intentional or impurities)	chemical products
16473	3-Bromo-4-fluorobenzonitrile	79630-23-2	Intentional addition	chemical products
16474	Sodium bis[3-[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzene-1-sulphonamidato(2-)]chromate(1-)	79655-38-6	Contains (regardless of intentional or impurities)	chemical products
16475	Ethanaminium, N-[[4-[[4-(diethylamino)phenyl]phenylmethylene]-2,5-cyclohexadien-1-ylidene]-N-ethyl-, copper(1+) (OC-6-11)-hexakis(cyano-C)ferrate(4-) (2:2:1)	79665-39-7	Intentional addition / 1,000ppm	chemical products
16476	Copper(1+) 2-[4-(dimethylamino)phenyl]-3,6-dimethylbenzothiazolium hexakis(cyano-c)ferrate(4-) (2:2:1)	79665-40-0	Intentional addition / 1,000ppm	chemical products
16477	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, copper(1+) (OC-6-11)-hexakis(cyano-C)ferrate(4-) (2:2:1)	79665-42-2	Intentional addition / 1,000ppm	chemical products
16478	2,3,4,4',5,6-Hentabromo[1,1]biphenyl	79682-25-0	Intentional addition / 1,000ppm	chemical products
16479	Tris[9-(2-carboxyphenyl)-3,6-bis(diethylamino)xanthylum] bis[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxynaphthalene-1-sulphonato(3-)]chromate(3-)	79682-34-1	Contains (regardless of intentional or impurities)	chemical products
16480	Ferrate(4-), hexakis(cyano-C)-, (OC-6-11)-, dicopper(1+) dihydrogen, compound with 4-[[4-(aminophenyl)(4-imino-2,5-cyclohexadien-1-ylidene)methyl]-2-methylbenzidine (1:2)]	79704-00-0	Intentional addition / 1,000ppm	chemical products
16481	Styrychindin-10-one, [(2.alpha.,3.alpha.,4.alpha.)-(+)-4-(carboxymethyl)tetrahydro-5-oxo-2,3-furandicarboxylate] (1:1)	79726-19-5	Contains (regardless of intentional or impurities)	chemical products
16482	Nickel [6,8,16,18-tetrachloro-1,11-bis(2-furanylmethyl)-1,10,11,20-tetrahydrodibenzoc[3,3']dipyrazolo[3,4-f:3',4'-m][1,2,5,8,12] hexaazacyclotetradecinato(2-)-N5,N10,N15,N20]-	79745-01-0	Contains (regardless of intentional or impurities)	chemical products
16483	Cobalt, butyl phosphate C3-10-fatty acid complexes	79803-78-4	Intentional addition / 1%	chemical products
16484	Zirconium, C3-10-fatty acids oxo complexes	79803-80-8	Contains (regardless of intentional or impurities)	chemical products
16485	Cobaltate(5-), bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)]-, pentasodium	79817-88-2	Intentional addition / 1,000ppm	chemical products
16486	Pentapotassium bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]naphthalene-2,7-disulphonato(4-)]cobaltate(5-)	79817-89-3	Intentional addition / 1,000ppm	chemical products
16487	Trihydrogen bis[4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzene-1-sulphonato(3-)]ferrate(3-)	79817-90-6	Intentional addition / 1%	chemical products
16488	Nickelate(3-), [5-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-3-[[2-hydroxy-3-nitro-5-sulphenyl]azo]-2,7-naphthalenedisulfonato(5-)]-, trisodium	79817-91-7	Contains (regardless of intentional or impurities)	chemical products
16489	Chromate(5-), bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)]-, pentasodium	79828-43-6	Contains (regardless of intentional or impurities)	chemical products
16490	Pentapotassium bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]naphthalene-2,7-disulphonato(4-)]chromate(5-)	79828-44-7	Contains (regardless of intentional or impurities)	chemical products
16491	3-Heptene, 7-bromo-, (Z)-	79837-80-2	Intentional addition / 1,000ppm	chemical products
16492	4-Octene, 1-bromo-, (Z)-	79837-81-3	Intentional addition / 1,000ppm	chemical products
16493	Dihydrogen [III(3-amino-4-sulphophenyl)amino]sulphonyl[disulphamoyl-29H,31H-phthalocyaninesulphonato(4-)-N29,N30,N31,N32]cuprate(2-)	79855-91-7	Intentional addition / 1,000ppm	chemical products
16494	Diammonium [III(3-[[2,5,6-trichloro-4-pyrimidinyl]amino]phenyl)amino]sulphonyl[disulphamoyl-29H,31H-phthalocyaninesulphonato(4-)-N29,N30,N31,N32]cuprate(2-)	79855-92-8	Intentional addition / 1,000ppm	chemical products
16495	1,3-Naphthalenedisulfonic acid, 7-amino-, potassium salt	79873-35-1	Contains (regardless of intentional or impurities)	chemical products
16496	2,7-Naphthalenedisulfonic acid, 3-amino-, sodium salt	79873-40-8	Contains (regardless of intentional or impurities)	chemical products
16497	Pentane, ethylmethyl-	79914-21-9	Intentional addition / 1%	chemical products
16498	Bis(triisobutyl)dibromosuccinate	79922-74-0	Contains (regardless of intentional or impurities)	chemical products
16499	2-Hexene, 1-bromo-, (Z)-	79930-19-1	Intentional addition / 1,000ppm	chemical products
16500	[N,N',N''-Tetrakis[2-(hexadecyloxy)phenyl]-29H,31H-phthalocyaninetetrasulphonamidato(2-)-N29,N30,N31,N32]copper	79953-86-9	Intentional addition / 1,000ppm	chemical products
16501	Bis(pentamethylcyclopentadienyl)cobalt(III) hexafluorophosphate	79973-42-5	Intentional addition / 1%	chemical products
16502	Chromate(2-), [4-[4-[[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-[4-[[6-chloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, disodium	79978-83-9	Contains (regardless of intentional or impurities)	chemical products
16503	Nitric acid, cadmium salt, hydrate	79990-52-6	Contains (regardless of intentional or impurities)	chemical products
16504	Naphthalene, 1-bromo-4-(bromomethyl)-	79996-99-9	Contains (regardless of intentional or impurities)	chemical products
16505	Boric acid, B-(1-methylethyl)-	80041-89-0	Intentional addition / 1%	chemical products
16506	[2,3,4-Trichloro-29H,31H-phthalocyanin-1-olato(2-)-N29,N30,N31,N32]copper	80042-44-0	Intentional addition / 1,000ppm	chemical products
16507	Dihydrogen trisulphite	80048-77-7	Contains (regardless of intentional or impurities)	chemical products
16508	Thallium(1+) 2,2-dimethylpentanoate	80057-39-2	Intentional addition / 1,000ppm	chemical products
16509	1-tert-Butyl-3-(2,6-diisopropyl-4-phenoxyphenyl)thiourea	80060-09-9	Intentional addition / 1%	chemical products
16510	Ferrate(1-), bis[3-[[3-[[4-[[4,6-bis[[3-(diethylamino)propyl]amino]-1,3,5-triazin-2-yl]amino]phenyl]azo]-2,5-dimethylphenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen, tris(2-hydroxypropanoate)(salt)	80063-37-2	Intentional addition / 1%	chemical products
16511	Ferrate(1-), bis[3-[[3-[[4-[[4,6-bis[[3-(diethylamino)propyl]amino]-1,3,5-triazin-2-yl]amino]phenyl]azo]-2,5-dimethylphenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen, tris(2-hydroxypropanoate)(salt)	80063-38-3	Intentional addition / 1%	chemical products
16512	Ferrate(1-), bis[3-[[3-[[4-[[4,6-bis[[3-(diethylamino)propyl]amino]-1,3,5-triazin-2-yl]amino]phenyl]azo]-2,5-dimethylphenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen, tris(2-hydroxypropanoate)(salt)	80063-40-7	Intentional addition / 1%	chemical products
16513	Ferrate(1-), bis[3-[[3-[[4-[[4,6-bis[[3-(diethylamino)propyl]amino]-1,3,5-triazin-2-yl]amino]phenyl]azo]-2,5-dimethylphenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen, tris(2-hydroxypropanoate)(salt)	80063-42-9	Intentional addition / 1%	chemical products
16514	Ferrate(1-), [3-[[3-[[4-[[4,6-bis[[3-(diethylamino)propyl]amino]-1,3,5-triazin-2-yl]amino]phenyl]azo]-2,5-dimethylphenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonamidato(2-)]-[3-[[4-[[4,6-bis[[3-(diethylamino)propyl]amino]-1,3,5-triazin-2-yl]amino]phenyl]azo]-2,5-dimethylphenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen, tris(2-hydroxypropanoate)(salt)	80083-42-7	Intentional addition / 1%	chemical products
16515	(2S)-3-Chloro-2-methylpropionyl chloride	80141-51-1	Contains (regardless of intentional or impurities)	chemical products
16516	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl sulfo derivatives	80146-12-9	Intentional addition / 1,000ppm	chemical products
16517	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl sulfo derivatives, ammonium lithium sodium salts	80146-13-0	Intentional addition / 1,000ppm	chemical products
16518	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with 3,3'-[[2-[[2-cyanoethyl]amino]ethyl]imino]bis[propanenitrile] and 3,3'-[[1,2-ethanediyldiimino]bis[propanenitrile]	80146-14-1	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16519	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with 3,3'-[[2-(2-cyanoethylamino)ethylamino]bis[propanenitrile]] and 3,3'-(1,2-ethanediyldiimino)bis[propanenitrile], acetates	80146-15-2	Intentional addition / 1,000ppm	chemical products
16520	Boron carbide (B9C)	80146-60-7	Intentional addition / 1%	chemical products
16521	Boron carbide (B15C2)	80146-62-9	Intentional addition / 1%	chemical products
16522	Dichloro, eta-5-2,4-cyclopentadien-1-yl)((1,2,3,3a,7a-eta)-1H-inden-1-yl)zirconium	80155-52-8	Contains (regardless of intentional or impurities)	chemical products
16523	Carbonic acid 1-chloroethyl methyl ester	80196-03-8	Intentional addition / 1%	chemical products
16524	2-Pentene, 2-bromo-	80204-19-9	Intentional addition / 1,000ppm	chemical products
16525	Strychnidin-10-one, (+)-[[4-(bromophenyl)sulfonyl]acetate (1:1)	80214-20-6	Contains (regardless of intentional or impurities)	chemical products
16526	5-Acetyl-2-methoxybenzenesulphonyl chloride	80223-79-6	Contains (regardless of intentional or impurities)	chemical products
16527	Tin tetrakis(2-sulphidoethyl) tetrasetate	80233-79-0	Contains (regardless of intentional or impurities)	chemical products
16528	Heptane, 4-(2-bromoethyl)-	80236-64-0	Intentional addition / 1,000ppm	chemical products
16529	Copper, bis[1,1,2,2-tetrafluoro-6,6-dimethyl-1-(trifluoromethoxy)-3,5-heptanedionato-kappa.O3,kappa.O5]-	80289-21-0	Intentional addition / 1,000ppm	chemical products
16530	Bis(boron difluorodiphenylglyoximate) cobaltate(II)	80290-99-9	Intentional addition / 1%	chemical products
16531	Undecane, 1,1,5-trichloro-	80385-36-2	Intentional addition / 1,000ppm	chemical products
16532	Undecane, 1,1,6-trichloro-	80385-37-3	Intentional addition / 1,000ppm	chemical products
16533	Undecane, 1,1,8-trichloro-	80385-38-4	Intentional addition / 1,000ppm	chemical products
16534	Undecane, 1,1,9-trichloro-	80385-39-5	Intentional addition / 1,000ppm	chemical products
16535	Undecane, 1,1,10-trichloro-	80385-40-8	Intentional addition / 1,000ppm	chemical products
16536	Acetic acid, [[3,5-bis(1,1-dimethylethyl)-4-hydroxyphenyl]methyl]thio]-, 2-ethylhexyl ester	80387-97-9	Contains (regardless of intentional or impurities)	chemical products
16537	2,3,4,5,5-Pentabromobiphenyl	80407-70-1	Intentional addition / 1,000ppm	chemical products
16538	Ammonium molybdenum oxide ((NH4)MoO3)	80407-98-3	Intentional addition / 1,000ppm	chemical products
16539	Ferrate(1-), [3]3-[[[3-[4,6-bis[[3-(diethylamino)propylamino]-1,3,5-triazin-2-yl]amino]phenyl]azo]-2,5-dimethylphenyl]azo]-2,4-dihydroxyphenylazo]-4-hydroxybenzenesulfonamidato(2-)]3-[[5-[[[3-[4,6-bis[[3-(diethylamino)propylamino]-1,3,5-triazin-2-yl]amino]phenyl]azo]-2,5-dimethylphenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonamidato(2-)]- , hydrogen, tris(2-hydroxypropanoate) (salt)	80410-35-1	Intentional addition / 1%	chemical products
16540	Cuprate(4-), [C-(aminosulfonyl)-C-[[[3-[4-chloro-6-[[3-sulfonyl]amino]-1,3,5-triazin-2-yl]amino]-4-sulfonyl]amino]sulfonyl]-29H,31H-phthalocyanine-C,O-disulfonato(6-)-N29,N30,N31,N32]-, tetrasodium	80431-67-0	Intentional addition / 1,000ppm	chemical products
16541	Trisodium [[[3-[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-sulfonyl]amino]sulphonyl]sulphamoyl-29H,31H-phthalocyaninedisulfonato(5-)-N29,N30,N31,N32]cuprate(3-)	80431-68-1	Intentional addition / 1,000ppm	chemical products
16542	Sodium bis[N-8-[[5-[[ethylamino]sulphonyl]-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthyl]acetamidato(2-)]chromate(1-)	80440-73-9	Contains (regardless of intentional or impurities)	chemical products
16543	2-tert-Butyl-4-(4-chlorophenyl)-1-(1,2,4-triazol-1-yl)-2-butanol	80443-41-0	Intentional addition / 1%	chemical products
16544	Cuprate(4-), [mu-[[[7,7-[[8-(phenylimino)-1,3,5-triazine-2,4-diyl]diimino]bis[4-hydroxy-3-[[2-(hydroxy-5-sulfonyl]azo]-2-naphthalenesulfonato]](8-)]di]-, tetrasodium	80448-87-9	Intentional addition / 1,000ppm	chemical products
16545	Cuprate(4-), [mu-[[[7,7-[[8-(phenylamino)-1,3,5-triazine-2,4-diyl]diimino]bis[3-[[3-chloro-2-hydroxy-5-sulfonyl]azo]-4-hydroxy-2-naphthalenesulfonato]](8-)]di]-, tetrasodium	80448-88-0	Intentional addition / 1,000ppm	chemical products
16546	4-Aminobenzeneboronic acid hydrochloride	80460-73-7	Intentional addition / 1%	chemical products
16547	Chromate(2-), [4-[4-[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydroxy-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]4[[5-chloro-2-hydroxyphenyl]azo]-2,4-dihydroxy-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]- , dihydrogen	80476-37-5	Contains (regardless of intentional or impurities)	chemical products
16548	(Octadec-9-enyl acetoacetato-O1,O3)diopropan-2-olatoaluminium	80481-35-2	Intentional addition / 1,000ppm	chemical products
16549	4-Methyl-3-nitrophenylboronic acid	80500-27-2	Intentional addition / 1%	chemical products
16550	2-[6-(or m- or p-)chloromethyl]phenyl]methyl propionate(mixture)	80530-54-7	Contains (regardless of intentional or impurities)	chemical products
16551	Cobalt(II) chloride	80546-49-2	Intentional addition / 1%	chemical products
16552	(±)-3-Bromo-2-methylpropionic acid	80586-28-3	Contains (regardless of intentional or impurities)	chemical products
16553	1.alpha.2.beta.3.alpha.beta.4.beta.7.beta.7.alpha.7.alpha.2,3,4,5,6,7,8,8-Nonachloro-2,3,3a,4,7,7a-hexahydro-4,7-methano-1H-indene	80625-07-6	Intentional addition / 6%	chemical products
16554	Orthoboric acid, compound with 2-(heptadecenyl)-4,5-dihydro-1H-imidazole-1-ethanol (1:1)	80634-45-3	Intentional addition / 1%	chemical products
16555	Tridecanoic acid, cobalt salt	80648-59-5	Intentional addition / 1%	chemical products
16556	1,1,1,2,2,3,3,4,4,5,5,6,6-Tridecafluorooctane	80793-17-5	Intentional addition / 1,000ppm	chemical products
16557	Manganese, [4-[[5-chloro-4-methyl-2-sulfonyl]azo]-1-hydroxy-2-naphthalenecarboxylato(2-)-O1,O2]-	80822-72-6	Contains (regardless of intentional or impurities)	chemical products
16558	2-Naphthalenecarboxylic acid, 4-[[5-chloro-4-methyl-2-sulfonyl]azo]-1-hydroxy-, barium salt (1:1)	80822-79-3	Contains (regardless of intentional or impurities)	chemical products
16559	Etofeprox	80844-07-1	Contains (regardless of intentional or impurities)	chemical products
16560	Sodium N-(cyanomethyl)naphthalene-2-sulphonamide	80866-78-0	Intentional addition	chemical products
16561	Zinc sulfate, dihydrate	80867-26-1	Intentional addition / 25%	chemical products
16562	Strychnidin-10-one, compound with methylarsenate (1:1)	80879-64-7	Contains (regardless of intentional or impurities)	chemical products
16563	Methyl 17.alpha.-hydroxyxyloimban-16.alpha.-carboxylate, methylarsenate (1:1)	80925-03-7	Contains (regardless of intentional or impurities)	chemical products
16564	L-4-Boronophenylalanine	80994-59-8	Intentional addition / 1%	chemical products
16565	2-Methyl-2-phenylpropylmercuric chloride	80994-87-2	Contains (regardless of intentional or impurities)	chemical products
16566	2-Oxoacetonitrile	80997-84-8	Intentional addition	chemical products
16567	Chromate(2-), [N-[[4-[4,5-dihydro-4-[[2-(hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]phenyl]-2-propenamido(2-)]3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonato(3-)]-, disodium	80997-91-7	Contains (regardless of intentional or impurities)	chemical products
16568	Chromate(2-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-[4-[[1-oxo-2-propenyl]amino]phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(3-)]-, disodium	80997-92-8	Contains (regardless of intentional or impurities)	chemical products
16569	Chromate(3-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonato(3-)]-, trisodium	80997-93-9	Contains (regardless of intentional or impurities)	chemical products
16570	Chromate(1-), bis[N-[[4,5-dihydro-4-[[2-(hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]phenyl]-2-propenamido(2-)]-, sodium	80997-94-0	Contains (regardless of intentional or impurities)	chemical products
16571	Chromate(2-), [2,4-dihydro-4-[[2-(hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]4-[[4,5-dihydro-3-methyl-5-nitrophenyl]azo]-6-[[1-oxo-2-propenyl]amino]-2-naphthalenesulfonato(3-)]-, disodium	80997-95-1	Contains (regardless of intentional or impurities)	chemical products
16572	3-Heptene, 1-bromo-, (E)-	81005-55-2	Intentional addition / 1,000ppm	chemical products
16573	Chromate(2-), [3-[[5-chloro-2-hydroxyphenyl]azo]-4-hydroxy-6-[[1-oxo-2-propenyl]amino]-2-naphthalenesulfonato(3-)]1-[[2-(hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, disodium	81013-01-6	Contains (regardless of intentional or impurities)	chemical products
16574	Propanoic acid, 3-bromo-2-methyl-, (S)-	81026-68-8	Contains (regardless of intentional or impurities)	chemical products
16575	Aluminum perchlorate nonahydrate	81029-96-3	Intentional addition / 1,000ppm	chemical products
16576	2-Ethylhexyl 4,4-dibutyl-12-ethyl-8,9-dioxo-5,10-dioxo-3-thia-4-stannahexadec-7-enoate	81034-75-5	Contains (regardless of intentional or impurities)	chemical products
16577	Ammonium hexachlororhodate(III) trihydrate	81044-99-9	Intentional addition / 1,000ppm	chemical products
16578	Barium 4-chloro-3-(4,5-dihydro-3-methyl-5-oxo-4-phenylazo)-1H-pyrazol-1-yl]benzenesulfonate	81064-51-9	Contains (regardless of intentional or impurities)	chemical products
16579	N-[4-(2-Chloropropanoyl)phenyl]acetamide	81112-08-5	Contains (regardless of intentional or impurities)	chemical products
16580	Monomethylidichlorodiphenylmethane	81161-70-8	Contains (regardless of intentional or impurities)	chemical products
16581	2-[[Diphenyl(methylene)amino]acetic acid methyl ester	81167-39-7	Intentional addition / 1%	chemical products
16582	Borane, chlorobis[1,1-dimethylethyl]-	81175-90-8	Intentional addition / 1%	chemical products
16583	Carbon oxide sulfide (COS2)	81202-14-4	Intentional addition / 1%	chemical products
16584	Cuprate(4-), [mu-[[[3-[5-oxobis[2-(hydroxy-4-1-phenylene)azo]]bis[4-hydroxy-2,7-naphthalenedisulfonato]](8-)]di]-, tetrahydrogen	81273-54-3	Intentional addition / 1,000ppm	chemical products
16585	Bis[2-[[5-chloro-2-pyridyl]azo]-5-(diethylamino)phenolato]cobalt(1+) chloride	81342-98-5	Intentional addition / 1,000ppm	chemical products
16586	Cobaltate(1-), bis[2-[[2-(hydroxy-4-nitrophenyl)azo]-3-oxo-N-phenylbutanamido(2-)]-, sodium	81361-02-6	Intentional addition / 1,000ppm	chemical products
16587	Chromate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-N-(1-methylthyl)benzenesulfonamidato(2-)]4-[[4-hydroxy-3-[[2-(hydroxy-1-naphthalenyl)azo]-N-(1-methylthyl)benzenesulfonamidato(2-)]-, hydrogen, compound with 2-propanamine (1:1)	81361-04-8	Contains (regardless of intentional or impurities)	chemical products
16588	Sodium [2,4-dihydro-4-[[2-(hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]1-[[2-(hydroxy-5-nitrophenyl)azo]-2-naphthalolato(2-)]chromate(1-)	81361-05-9	Contains (regardless of intentional or impurities)	chemical products
16589	Sodium 1-[[2-(hydroxy-3-nitro-5-tert-pentylphenyl)azo]-2-naphthalolato(2-)]1-[[2-(hydroxy-4-nitrophenyl)azo]-2-naphthalolato(2-)]chromate(1-)	81361-06-0	Contains (regardless of intentional or impurities)	chemical products
16590	Sodium 1-[[2-(hydroxy-3-nitro-5-tert-pentylphenyl)azo]-2-naphthalolato(2-)]1-[[2-(hydroxy-5-nitrophenyl)azo]-2-naphthalolato(2-)]chromate(1-)	81372-34-1	Contains (regardless of intentional or impurities)	chemical products
16591	Strychnidin-10-one, mono(R)-[[4-(bromophenyl)methyl]sulfonyl]acetate	81431-41-6	Contains (regardless of intentional or impurities)	chemical products
16592	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (butylamino)sulfonyl [(2-ethylhexylamino)sulfonyl] derivatives	81457-64-9	Intentional addition / 1,000ppm	chemical products
16593	Copper, [29H, 31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-(methylethoxy)-, propylaminosulfonyl] derivatives	81457-65-0	Intentional addition / 1,000ppm	chemical products
16594	Amines, C12-18-alkyl, bis[2,4-dihydro-4-[[2-(hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)] (1:1)	81457-66-1	Contains (regardless of intentional or impurities)	chemical products
16595	Copper, (1-imino-1H-isoindol-3-aminato-N2)methoxy[29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (OC-6-42)-	81478-26-4	Intentional addition / 1,000ppm	chemical products
16596	2-Methyl-5-(1'-methylthylethyl)-cyclohexanol	81489-56-7	Intentional addition / 1,000ppm	chemical products
16597	Tin(4+) 2-methylpropanoate	81514-95-8	Contains (regardless of intentional or impurities)	chemical products
16598	4-Butoxyphthalonitrile	81560-32-9	Intentional addition	chemical products
16599	Cuprate(3-), [2-[[[3-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-hydroxy-5-sulfonyl]azo]phenylmethyl]azo]-5-sulfobenzoato(5-)]-, trisodium	81611-05-4	Intentional addition / 1,000ppm	chemical products
16600	1-Octadecanaminium, N,N-dimethyl-N-octadecyl-, [29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]cuprate(1-)	81626-37-1	Intentional addition / 1,000ppm	chemical products
16601	Chromate(1-), [N-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]acetamidato(2-)]methyl [8-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]carbamato(2-)]-, sodium	81642-71-9	Contains (regardless of intentional or impurities)	chemical products
16602	Tetrahydrogen [mu-[[[4,4'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[3-hydroxynaphthalene-2,7-disulphonato]](8-)]dicuprate(4-)]	81737-16-8	Intentional addition / 1,000ppm	chemical products
16603	Tetrahydrogen [mu-[[[4,4'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[3-hydroxynaphthalene-2,7-disulphonato]](8-)]dicuprate(4-), compound with 2,2,2'-nitrioltriethanol (1:4)	81737-17-9	Intentional addition / 1,000ppm	chemical products
16604	Tributyltetradecylphosphonium chloride	81741-28-8	Intentional addition / 1,000ppm	chemical products
16605	Barium bis(tetracosylbenzenesulphonate)	81856-06-6	Contains (regardless of intentional or impurities)	chemical products
16606	3,3',4,5,5-Pentabromobiphenyl	81902-33-2	Intentional addition / 1,000ppm	chemical products
16607	Hexanoic acid, 2-ethyl-, cobalt(3+) salt	81955-22-8	Intentional addition / 1%	chemical products
16608	Molybdate (MoO22-), barium (1:1)	81986-84-7	Intentional addition / 1,000ppm	chemical products
16609	Copper oxide (CuO), mixture with copper oxide (Cu2O)	82010-82-0	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16610	Cuprate(6-), [mu-[[3,3'-azobis[6-[2-[4-[[3-hydroxy-4-[[2-hydroxy-5-sulfonylphenyl]azo]phenyl]azo]-2-sulfonylphenyl]ethenyl]benzenesulfonato]](10-)]di-, hexasodium	82027-60-9	Contains (regardless of intentional or impurities)	chemical products
16611	1-Amino-4-hydroxy-9,10-dioxo-9,10-dihydroanthracene-2,3-dicarboxylic anhydride	82052-28-6	Contains (regardless of intentional or impurities)	chemical products
16612	1-Hexene, 6-bromo-3-methyl-	82217-27-4	Intentional addition / 1,000ppm	chemical products
16613	6-Bromo-1,4-dioxaspiro[4.4]nonane	82235-82-3	Contains (regardless of intentional or impurities)	chemical products
16614	Poly(4-vinylpyridinium dichromate)	82246-45-5	Intentional addition / 1,000ppm	chemical products
16615	1,7-Dichlorodibenzo[b,e][1,4]dioxin	82291-28-7	Intentional addition / 1,000ppm	chemical products
16616	1,8-Dichlorodibenzo[b,e][1,4]dioxin	82291-27-8	Intentional addition / 1,000ppm	chemical products
16617	Dibenzo(b,e)[1,4]dioxin, 1,9-dichloro-	82291-29-9	Intentional addition / 1,000ppm	chemical products
16618	1,2,6-Trichlorodibenzo[b,e][1,4]dioxin	82291-29-0	Intentional addition / 1,000ppm	chemical products
16619	1,2,7-Trichlorodibenzo[b,e][1,4]dioxin	82291-30-3	Intentional addition / 1,000ppm	chemical products
16620	1,2,8-Trichlorodibenzo[b,e][1,4]dioxin	82291-31-4	Intentional addition / 1,000ppm	chemical products
16621	1,2,9-Trichlorodibenzo[b,e][1,4]dioxin	82291-32-5	Intentional addition / 1,000ppm	chemical products
16622	1,3,6-Trichlorodibenzo[b,e][1,4]dioxin	82291-33-6	Intentional addition / 1,000ppm	chemical products
16623	1,2,3,6,9-Pentachlorodibenzo[b,e][1,4]dioxin	82291-34-7	Intentional addition / 1,000ppm	chemical products
16624	1,2,4,6,7-Pentachlorodibenzo[b,e][1,4]dioxin	82291-35-8	Intentional addition / 1,000ppm	chemical products
16625	1,2,4,6,9-Pentachlorodibenzo-p-dioxin	82291-36-9	Intentional addition / 1,000ppm	chemical products
16626	1,2,4,7,9-Pentachlorodibenzo-p-dioxin	82291-37-0	Intentional addition / 1,000ppm	chemical products
16627	1,2,4,8,9-Pentachlorodibenzo(b,e)[1,4]dioxin	82291-38-1	Intentional addition / 1,000ppm	chemical products
16628	1,2,4,8,9-Pentachlorodibenzo(b,e)[1,4]dioxin	82306-61-4	Intentional addition / 1,000ppm	chemical products
16629	1,3,9-Trichlorodibenzo[b,e][1,4]dioxin	82306-62-5	Intentional addition / 1,000ppm	chemical products
16630	1,4,6-Trichlorodibenzo[b,e][1,4]dioxin	82306-63-6	Intentional addition / 1,000ppm	chemical products
16631	1,4,7-Trichlorodibenzo[b,e][1,4]dioxin	82306-64-7	Intentional addition / 1,000ppm	chemical products
16632	1,7,8-Trichlorodibenzo(b,e)[1,4]dioxin	82306-65-8	Intentional addition / 1,000ppm	chemical products
16633	Hydrogen bis[[5,8-dichloro-2-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthalato(2-)]cobaltate(1-), compound with cyclohexylamine (1:1)	82338-72-5	Intentional addition / 1,000ppm	chemical products
16634	Hydrogen bis[[5,8-dichloro-2-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalato(2-)]cobaltate(1-), compound with cyclohexylamine (1:1)	82338-74-7	Intentional addition / 1,000ppm	chemical products
16635	9-[2-Carboxyphenyl]-3,6-bis(diethylamino)xanthylum bis[2,4-dihydro-4[[2-hydroxy-5-(methylsulfonyl)-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-4-y]chromate(1-)	82338-75-8	Contains (regardless of intentional or impurities)	chemical products
16636	C.I. Pigment Blue 62	82338-76-9	Intentional addition / 1,000ppm	chemical products
16637	Sodium bis[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-y]azo]-4-hydroxybenzene-1-sulphonamidato(2-)]chromate(1-)	82338-77-0	Contains (regardless of intentional or impurities)	chemical products
16638	Sodium bis[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-y]azo]-3-hydroxybenzene-1-sulphonamidato(2-)]chromate(1-)	82338-78-1	Contains (regardless of intentional or impurities)	chemical products
16639	Propanoic acid, 3-chloro-2-methyl-, (S)-	82340-63-4	Contains (regardless of intentional or impurities)	chemical products
16640	4-(Methylamino)-3-nitrobenzoyl chloride	82357-48-0	Contains (regardless of intentional or impurities)	chemical products
16641	1,3-Dibutyl-1,1,3,3-tetrafluorodisiloxane	82364-22-5	Contains (regardless of intentional or impurities)	chemical products
16642	2-Fluoro-4-hydroxybenzoxazole	82380-18-5	Contains (regardless of intentional or impurities)	chemical products
16643	Molybdenum silicide (Mo2Si3)	82391-70-6	Intentional addition / 1,000ppm	chemical products
16644	Droloxifene	82413-20-5	Contains (regardless of intentional or impurities)	chemical products
16645	Hydrogen [3-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-4-y]benzenesulphonamidato(2-)](4-hydroxy-3-[[2-hydroxy-1-naphthyl]azo]benzenesulphonamidato(2-)]chromate(1-)	82457-11-2	Contains (regardless of intentional or impurities)	chemical products
16646	Pentasodium [3-[4,5-dihydro-4-[[1-hydroxy-3-sulpho-7-(3-sulphoamino)-2-naphthyl]azo]-o-tolyl]azo]-7-sulpho-1-naphthyl]azobenzene-1,5-disulphonato(7-)]cuprate(5-)	82457-12-3	Intentional addition / 1,000ppm	chemical products
16647	Sodium bis[[N-(7-hydroxy-8-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthyl]acetamidato(2-)]chromate(1-)]	82457-13-4	Contains (regardless of intentional or impurities)	chemical products
16648	Isobutyl 5-[5-acetamido-2-methoxy-4-[[5-nitrothiazol-2-y]azo]phenyl]-1,2-methyl-9-oxo-2,8,10-trioxo-5-azatriazecane	82457-22-5	Contains (regardless of intentional or impurities)	chemical products
16649	Cobaltate(3-), [4-amino-3-[[2-hydroxy-3,5-dinitrophenyl]azo]-1-naphthalenesulfonato(3-)](5-amino-6-[[2-hydroxy-3,5-dinitrophenyl]azo]-1-naphthalenesulfonato(3-)]-, trisodium	82457-28-1	Intentional addition / 1,000ppm	chemical products
16650	Cuprate(5-), [mu-[[2-[[1-[4-[[2-[4-[[4-[[2-[4-[[2-carboxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-y]]-2-sulfonylphenyl]ethenyl]-3-sulfonylphenyl]amino]-6-(4-morpholinyl)-1,3,5-triazin-2-y]amino]-2-sulfonylphenyl]ethenyl]-3-sulfonylphenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-y]azo]-5-sulfonylbenzoato(9-)]di-, pentasodium	82469-75-8	Intentional addition / 1,000ppm	chemical products
16651	Barium 2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulphonatophenyl)-1H-pyrazol-4-y]azo]benzoate	82469-76-9	Contains (regardless of intentional or impurities)	chemical products
16652	Phosphoric acid, vanadium(3+) salt (1:1), tetrahydrate	82477-27-8	Intentional addition / 1%	chemical products
16653	2-(Butylnitroamino)ethyl nitrate	82486-82-6	Contains (regardless of intentional or impurities)	chemical products
16654	Trisiron(III) orthoborate	82493-16-1	Intentional addition / 1%	chemical products
16655	(6R,7R)-[[2-(2-Aminotiazole-4-yl)-2-methoxyiminoacetamide]-3-[[5-methyl-2H-tetrazol-2-yl)methyl]-8-oxo-thia-1-azabicyclo[4.2.0]octa-3-en-2-carboxylic acid-pivaloyloximethyl	82547-81-7	Contains (regardless of intentional or impurities)	chemical products
16656	Isocetyl [[butylthioxostannyl]thio]acetate	82554-77-6	Contains (regardless of intentional or impurities)	chemical products
16657	Cobaltate(3-), bis[2-[[[4-hydroxy-3-[[2-(phenylamino)-1-naphthalenyl]azo]phenyl]sulfonyl]amino]benzoato(3-)]-, trisodium	82556-12-5	Intentional addition / 1,000ppm	chemical products
16658	Cobaltate(2-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](2-[[[4-hydroxy-3-[[2-(phenylamino)-1-naphthalenyl]azo]phenyl]sulfonyl]amino]benzoato(3-)]-, disodium	82556-13-6	Intentional addition / 1%	chemical products
16659	Benfurcarb	82560-54-1	Contains (regardless of intentional or impurities)	chemical products
16660	2,3-Dichloro-1,1-difluoropropane	82578-00-5	Intentional addition	chemical products
16661	Bis(DL-methioninato-N,O)iron	82597-91-9	Intentional addition / 1%	chemical products
16662	Bromo-/Chloro-alpha-olefin	82600-56-4	Intentional addition / 900ppm	chemical products
16663	Chromium, 1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenol lithium sodium complexes	82640-06-0	Intentional addition / 1,000ppm	chemical products
16664	Copper, complexes with diazotized 3-amino-4-methoxybenzenesulfonic acid monosodium salt coupled with diazotized 4-nitro-1,3-benzenediamine and resorcinol, sodium salts	82640-07-1	Intentional addition / 1,000ppm	chemical products
16665	Iron, complexes with diazotized 3-amino-2-hydroxy-5-nitrobenzenesulfonic acid monosodium salt coupled with diazotized 2-amino-4-nitrophenol and resorcinol, sodium salts	82640-18-4	Intentional addition / 1%	chemical products
16666	Bifenhrin	82657-04-3	Contains (regardless of intentional or impurities)	chemical products
16667	Iron, complexes with diazotized 3-amino-4-hydroxybenzenesulfonic acid monosodium salt coupled with diazotized 4-nitrobenzenamine and resorcinol, sodium salts	82707-46-8	Intentional addition / 1%	chemical products
16668	Benzenesulfonic acid, hydroxy-, tin salt	82734-44-9	Intentional addition / 1,000ppm	chemical products
16669	Iron tris(2-ethylbutyrate)	82807-83-8	Intentional addition / 1%	chemical products
16670	[trans(trans)]-1-Fluoro-4-(4-propyl[1,1'-bicyclohexyl]-4-y]benzene	82832-27-7	Intentional addition / 1,000ppm	chemical products
16671	[N,N',N''-Tetrakis[3-(dimethylamino)propyl]-2,9H,31H-phthalocyaninetetrasulphonamidato(2-)](N29,N30,N31,N32)copper tetraacetate	82864-55-9	Intentional addition / 1,000ppm	chemical products
16672	Copper, [N,N',N''-Tetrakis[3-(dimethylamino)propyl]-2,9H,31H-phthalocyanine-C,C,C,C-tetrasulphonamidato(2-)](N29,N30,N31,N32)-, tetrahydrochloride	82864-56-0	Intentional addition / 1,000ppm	chemical products
16673	[N,N',N''-Tris[3-(dimethylamino)propyl]-2,9H,31H-phthalocyaninetrisulphonamidato(2-)](N29,N30,N31,N32)copper trisacetate	82864-57-1	Intentional addition / 1,000ppm	chemical products
16674	[N,N',N''-Tris[3-(dimethylamino)propyl]-2,9H,31H-phthalocyaninetrisulphonamidato(2-)](N29,N30,N31,N32)copper trihydrochloride	82864-58-2	Intentional addition / 1,000ppm	chemical products
16675	2,2,3,3,4,5,5-Heptabromobiphenyl	82865-92-7	Intentional addition / 1,000ppm	chemical products
16676	2,5-Pyrrolidinedione, 1-[[[9H-fluoren-9-ylmethoxy]carbonyloxy]-	82911-69-1	Contains (regardless of intentional or impurities)	chemical products
16677	Vanadium diformate	82920-66-9	Intentional addition / 1%	chemical products
16678	Chromate(1-), [2-[[4,5-dihydro-3-methyl-1-(2-methyl-4-sulfonylphenyl)-5-oxo-1H-pyrazol-4-y]azo]-4-sulfonylbenzoato(4-)]-, sodium	82933-88-8	Contains (regardless of intentional or impurities)	chemical products
16679	[6-Amino-5-[[2-hydroxy-4-nitrophenyl]azo]naphthalene-2-sulphonato(3-)]chromium	82933-89-9	Intentional addition / 1,000ppm	chemical products
16680	Chromate(1-), [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulfonylphenyl)-1H-pyrazol-4-y]azo]-2-hydroxybenzenesulfonato(4-)]-, sodium	82933-90-2	Contains (regardless of intentional or impurities)	chemical products
16681	Chloro[2-(ethyl-1-oxohexyl)oxy]dimethylstannane	82963-02-8	Contains (regardless of intentional or impurities)	chemical products
16682	Zirconate(2-), oxobis(sulfato(2-))O-, disodium, dihydrate	82996-23-4	Contains (regardless of intentional or impurities)	chemical products
16683	Cuprate(4-), [mu-[[7-(benzoylamino)-3-[[3,3'-dihydroxy-4'-[[1-hydroxy-4,8-disulfo-2-naphthalenyl]azo][1,1'-biphenyl]-4-y]azo]-4-hydroxy-1,5-naphthalenedisulfonato(8-)]di-, tetrasodium	83027-55-8	Intentional addition / 1,000ppm	chemical products
16684	Chromate(3-), bis[2-hydroxy-5-[[[4-[[4-nitro-2-sulfonylphenyl]amino]phenyl]azo]benzoato(3-)]O1,O2]-, trisodium	83027-56-9	Contains (regardless of intentional or impurities)	chemical products
16685	Disodium [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-y]azo]benzoato(2-)](2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-y]azo]-5-sulfonylbenzoato(3-)]chromate(2-)	83027-57-0	Contains (regardless of intentional or impurities)	chemical products
16686	Chromate(3-), bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-y]azo]-5-sulfonylbenzoato(3-)]-, trisodium	83027-58-1	Contains (regardless of intentional or impurities)	chemical products
16687	Heptadecafluorodecyl-trimethoxysilane	83048-65-1	Contains (regardless of intentional or impurities)	chemical products
16688	1-Chloro-1,1,3-trifluoropropane	83124-56-5	Intentional addition	chemical products
16689	3-Chloro-1,1-difluoropropane	83124-57-6	Intentional addition	chemical products
16690	1,3-Dichloro-1-fluoropropane	83124-60-1	Intentional addition	chemical products
16691	Alanycarb	83130-01-2	Intentional addition / 1%	chemical products
16692	(R)-2,3-Dibromopropan-1-ol	83165-35-9	Intentional addition	chemical products
16693	(S)-2,3-Dibromopropan-1-ol	83165-36-0	Intentional addition	chemical products
16694	6,8'-[[3,3'-Dimethoxy[1,1'-biphenyl]-4,4'-diyl]diazo]bis[4-amino-5-hydroxynaphthalene-1,3-disulphonic] acid, lithium sodium salt	83221-70-9	Intentional addition	chemical products
16695	Benzoic acid, 2-[[2-amino-5-hydroxy-6-[[[4-[[2-hydroxy-6-sulfo-1-naphthalenyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-y]azo]-7-sulfo-1-naphthalenyl]azo]-5-nitro-, sodium salt	83221-79-8	Intentional addition	chemical products
16696	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]-, sodium	83232-44-4	Contains (regardless of intentional or impurities)	chemical products
16697	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, sodium	83232-45-5	Contains (regardless of intentional or impurities)	chemical products
16698	Sodium [4-hydroxy-3-[[2-hydroxy-1-naphthyl]azo]benzenesulphonamidato(2-)](N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthyl]acetamidato(2-)]chromate(1-)	83232-46-6	Contains (regardless of intentional or impurities)	chemical products
16699	Sodium bis[4-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-y]azo]benzenesulphonamide S,S-dioxidato(2-)]chromate(1:1)	83232-47-7	Contains (regardless of intentional or impurities)	chemical products
17000	Chromate(1-), [N-[[4-hydroxy-3-[[2-hydroxy-8-[[methylsulfonyl]amino]-1-naphthalenyl]azo]-5-nitrophenyl]acetamidato(2-)](4-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-y]azo]benzenesulfonamide S,S-dioxidato(2-)]-, sodium	83232-48-8	Contains (regardless of intentional or impurities)	chemical products
17001	Sodium [4-hydroxy-3-[[2-hydroxy-1-naphthyl]azo]benzenesulphonamidato(2-)](4-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-y]azo]benzenesulphonamide S,S-dioxidato(2-)]chromate(1-)	83232-49-9	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16702	Sodium [N-[4-hydroxy-3-[[2-hydroxy-8-(methylamino)-1-naphthyl]azo]-5-nitrophenyl]acetamidato(2-)]-[4-hydroxy-3-[[2-hydroxy-1-naphthyl]azo]benzenesulphonamidato(2-)]chromate(1-)	83232-50-2	Contains (regardless of intentional or impurities)	chemical products
16703	Sodium bis[N-(4-hydroxy-3-[[2-hydroxy-8-(methylsulphonyl)amino]-1-naphthyl]azo)-5-nitrophenyl]acetamidato(2-)]chromate(1-)	83232-51-3	Contains (regardless of intentional or impurities)	chemical products
16704	Cuprate(3-), [8-hydroxy-7-[[3-hydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-3'-methoxy]1,1'-biphenyl]-4-yl]azo]-1,6-naphthalenedisulfonato(5-)-, trisodium	83232-52-4	Intentional addition / 1,000ppm	chemical products
16705	Cuprate(4-), [mu-[[3,3'-dihydroxy]1,1'-biphenyl]-4,4'-diyl]bis[azo]bis[5-ethoxy-4-hydroxy-2,7-naphthalenedisulfonato(8-)]id- tetrasodium	83232-53-5	Intentional addition / 1,000ppm	chemical products
16706	Trisodium [mu-[[5-acetamido-3-[[4-[[1,6-dihydroxy-4-sulfo-2-naphthyl]azo]-3,3'-dihydroxy]1,1'-biphenyl]-4-yl]azo]-4-hydroxynaphthalene-2,7-disulphonato(7-)]dicuprate(3-)	83232-54-6	Intentional addition / 1,000ppm	chemical products
16707	Cuprate(4-), [4-[[4-[[[3-chloro-2-hydroxy-5-sulphophenyl]azo]-5-hydroxy-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-5-methoxy-2-methylphenyl]azo]-5-hydroxy-2,7-naphthalenedisulfonato(6-)-, tetrasodium	83232-55-7	Intentional addition / 1,000ppm	chemical products
16708	Cuprate(5-), [2-[4-[[2-[[3-hydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-7-sulfo-1-naphthalenyl]azo]-2-sulphophenyl]ethenyl]-3-sulphophenyl]2H-naphtho[1,2-d]triazole-5-sulfonato(7-)-, pentasodium	83232-56-8	Intentional addition / 1,000ppm	chemical products
16709	Acetamide, 2-chloro-N-(hydroxymethyl)-, mixture with boron sodium oxide (B4Na2O7) and potassium iodide	83245-20-9	Intentional addition / 1%	chemical products
16710	Chromate(1-), [2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]methanesulphonamidato(2-)-, sodium	83249-26-7	Contains (regardless of intentional or impurities)	chemical products
16711	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)-, trithium	83249-27-8	Contains (regardless of intentional or impurities)	chemical products
16712	Sodium [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphtholato(2-)]chromate(1-)	83249-62-1	Contains (regardless of intentional or impurities)	chemical products
16713	Sodium [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]N-[8-[[5-(ethylsulphonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthyl]methanesulphonamidato(2-)]chromate(1-)	83249-63-2	Contains (regardless of intentional or impurities)	chemical products
16714	Sodium [N-[8-[[5-(ethylsulphonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthyl]methanesulphonamidato(2-)]-[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphtholato(2-)]chromate(1-)	83249-64-3	Contains (regardless of intentional or impurities)	chemical products
16715	Sodium [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphtholato(2-)]chromate(1-)	83249-65-4	Contains (regardless of intentional or impurities)	chemical products
16716	Chromate(1-), bis[3-[[[5-[[2-chloro-4-nitrophenyl]azo]-2-hydroxyphenyl]methylene]amino]-4-hydroxybenzenesulfonamidato(2-)-, lithium	83249-66-5	Contains (regardless of intentional or impurities)	chemical products
16717	Chromate(1-), bis[3-[[[5-[[2-chloro-4-nitrophenyl]azo]-2-hydroxyphenyl]methylene]amino]-4-hydroxybenzenesulfonamidato(2-)-, sodium	83249-67-6	Contains (regardless of intentional or impurities)	chemical products
16718	Lithium bis[2-[[5-(aminosulphonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutylamidato(2-)]cobaltate(1-)	83249-68-7	Intentional addition / 1,000ppm	chemical products
16719	Sodium [2-[[5-(aminosulphonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutylamidato(2-)]-[3-[[1-(benzothiazol-2-yl)-2-oxopropyl]azo]-4-hydroxybenzenesulphonamidato(2-)]cobaltate(1-)	83249-69-8	Intentional addition / 1,000ppm	chemical products
16720	Hydrogen [2-[[5-(aminosulphonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutylamidato(2-)]-[3-[[1-(benzothiazol-2-yl)-2-oxopropyl]azo]-4-hydroxybenzenesulphonamidato(2-)]cobaltate(1-)	83249-70-1	Intentional addition / 1,000ppm	chemical products
16721	Sodium bis[3-[[1-(benzothiazol-2-yl)-2-oxopropyl]azo]-4-hydroxybenzenesulphonamidato(2-)]cobaltate(1-)	83249-71-2	Intentional addition / 1,000ppm	chemical products
16722	Lithium bis[3-[[1-(benzothiazol-2-yl)-2-oxopropyl]azo]-4-hydroxybenzenesulphonamidato(2-)]cobaltate(1-)	83249-72-3	Intentional addition / 1,000ppm	chemical products
16723	Hydrogen bis[3-[[1-(benzothiazol-2-yl)-2-oxopropyl]azo]-4-hydroxybenzenesulphonamidato(2-)]cobaltate(1-)	83249-73-4	Intentional addition / 1,000ppm	chemical products
16724	Lithium [2-[[5-(aminosulphonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutylamidato(2-)]-[3-[[1-(benzothiazol-2-yl)-2-oxopropyl]azo]-4-hydroxybenzenesulphonamidato(2-)]cobaltate(1-)	83270-30-8	Intentional addition / 1,000ppm	chemical products
16725	Amines, rosin, compounds with 9-(2-carboxyphenyl)-3,6-bis(diethylamino)xanthylium chloride, 4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-1-yl]azo]-3-hydroxy-1-naphthalenesulfonic acid chromium sodium complexes and formic acid	83270-49-9	Intentional addition / 1,000ppm	chemical products
16726	4-Octene, 1-bromo-3,7-dimethyl-, (E)-	83323-71-1	Intentional addition / 1,000ppm	chemical products
16727	Dibromohexanes	83343-61-7	Intentional addition / 1,000ppm	chemical products
16728	4-Thia-2,6-diazabicyclo[3.2.0]hept-2-ene-6-acetic acid, 3-benzoyl-alpha-[1-(chloromethyl)ethenyl]-7-oxo-, methyl ester	83377-66-6	Intentional addition / 1,000ppm	chemical products
16729	Barium 3-hydroxy-4-[[2,4,5-trichlorophenyl]azo]naphthalene-2,7-disulphonate	83399-82-0	Contains (regardless of intentional or impurities)	chemical products
16730	3,3'-[[3,3'-Dimethoxy]1,1'-biphenyl]-4,4'-diyl]bis[azo(2-amino-4-hydroxynaphthalene-2,7-disulphonic acid), lithium sodium salt	83400-08-2	Intentional addition	chemical products
16731	Cobaltate(5-), bis[4-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-[[4-chloro-6-[[4-[4,5-dihydro-4-[[2-hydroxy-5-sulphophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]phenyl]amino]-1,3,5-triazin-2-yl]amino]benzenesulfonato(4-)]-, pentasodium	83417-32-7	Intentional addition / 1,000ppm	chemical products
16732	Cobaltate(7-), [5-[[4-chloro-6-[[5-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-sulphophenyl]azo]-2,7-naphthalenedisulfonato(6-)]-[4-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-[[4-chloro-6-[[4-[4,5-dihydro-4-[[2-hydroxy-5-sulphophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]phenyl]amino]-1,3,5-triazin-2-yl]amino]benzenesulfonato(4-)]-, heptasodium	83417-33-8	Intentional addition / 1%	chemical products
16733	Cobaltate(9-), bis[5-[[4-chloro-6-[[5-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-sulphophenyl]azo]-2,7-naphthalenedisulfonato(6-)]-, nonasodium	83417-34-9	Intentional addition / 1,000ppm	chemical products
16734	Trisodium [6-[[[2,3-dichloroquinaxalin-6-yl]carbonyl]amino]-4-hydroxy-3-[[2-hydroxy-5-sulphophenyl]azo]naphthalene-2,7-disulphonato(5-)]cuprate(3-)	83417-35-0	Intentional addition / 1,000ppm	chemical products
16735	Acetic acid, mercapto-, C10-16-alkyl esters, reaction products with dichlorodicyclopentane and trichloroethylstannane	83447-69-2	Contains (regardless of intentional or impurities)	chemical products
16736	Strychnidin-10-one, (R)-methylbutanedioate	83450-60-6	Contains (regardless of intentional or impurities)	chemical products
16737	Bromochloroacetnitrile	83463-82-1	Contains (regardless of intentional or impurities)	chemical products
16738	4-[4-(alpha, alpha-Dimethyl benzophenoxyl)phthalonitrile	83482-57-9	Intentional addition	chemical products
16739	Manganate(1-), tetrafluoro-, (T-4)-	83503-76-8	Contains (regardless of intentional or impurities)	chemical products
16740	Sodium [3-[[2,4-dihydroxy-5-[[4-nitrophenyl]azo]phenyl]azo]-4-hydroxybenzenesulphonato(3-)]cuprate(1-)	83562-89-4	Intentional addition / 1,000ppm	chemical products
16741	Chromate(1-), bis[N-[7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl]acetamidato(2-)-, sodium	83562-94-1	Contains (regardless of intentional or impurities)	chemical products
16742	1-Phenylcicosane-1,3-dione, barium salt	83581-80-0	Contains (regardless of intentional or impurities)	chemical products
16743	1-[2-Sulfo-4-methyl-5-chlorophenyl]azo]-2-hydroxy-3-naphthoic acid-2',4'-dimethoxy-5'-chloranilide barium salt	83588-55-0	Intentional addition / 1,000ppm	chemical products
16744	Phosphoric acid, triethyl ester, reaction products with aluminum sec-butoxide, chromium oxide (CrO3) and silica	83588-58-3	Contains (regardless of intentional or impurities)	chemical products
16745	Phosphoric acid, triethyl ester, reaction products with chromium oxide (CrO3) and silica	83588-59-4	Contains (regardless of intentional or impurities)	chemical products
16746	Benzenamine, 2-methyl-N-propyl-	83627-55-8	Intentional addition / 25%	chemical products
16747	Butyl cyclopropanesulfonate	83635-12-5	Contains (regardless of intentional or impurities)	chemical products
16748	1-Hexene, 3-(bromomethyl)-5-methyl-	83646-22-4	Intentional addition / 1,000ppm	chemical products
16749	2-Hexene, 1-bromo-5-methyl-	83646-27-9	Intentional addition / 1,000ppm	chemical products
16750	2-Chlorocyclohexan-1-en-1,3-dicarbaldhyde	83710-73-0	Contains (regardless of intentional or impurities)	chemical products
16751	Barium, C5-23-branched carboxylate C4-10-fatty acid naphthenate complexes	83711-36-8	Contains (regardless of intentional or impurities)	chemical products
16752	Barium, C5-23-branched carboxylate naphthenate complexes	83711-37-9	Contains (regardless of intentional or impurities)	chemical products
16753	Barium, C5-23-branched carboxylate naphthenate octanoate complexes	83711-38-0	Contains (regardless of intentional or impurities)	chemical products
16754	Cobalt, C5-23-branched carboxylate C4-10-fatty acid naphthenate complexes	83711-42-6	Intentional addition / 1,000ppm	chemical products
16755	Cobalt, C5-23-branched carboxylate naphthenate complexes	83711-43-7	Intentional addition / 1,000ppm	chemical products
16756	Cobalt, C5-23-branched carboxylate naphthenate octanoate complexes	83711-44-8	Intentional addition / 1,000ppm	chemical products
16757	Zirconium, C5-23-branched carboxylate naphthenate complexes	83711-54-0	Contains (regardless of intentional or impurities)	chemical products
16758	Zirconium, C5-23-branched carboxylate naphthenate octanoate complexes	83711-55-1	Contains (regardless of intentional or impurities)	chemical products
16759	Pentane, 3-(bromomethylene)-2,4,4-tetramethyl-	83720-76-7	Intentional addition / 1,000ppm	chemical products
16760	5,5'-[[3,3'-Dimethoxy]1,1'-biphenyl]-4,4'-diyl]bis[azo(2-amino-5-hydroxy-7-sulphonaphthalene-6,1-diyl)azo]bis[1H-1,2,4-triazole-3-carboxylic acid, ammonium sodium salt	83721-51-1	Intentional addition	chemical products
16761	Chromate(1-), bis[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-N,N-dimethylbenzenesulfonamidato(2-)-, lithium	83732-89-2	Contains (regardless of intentional or impurities)	chemical products
16762	Chromate(2-), [4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-[4-hydroxy-3-[[2-methyl-4H-pyrazol(1,5-a)benzimidazol-3-yl]azo]benzenesulfonamidato(2-)-], disodium	83732-90-5	Contains (regardless of intentional or impurities)	chemical products
16763	Chromate(1-), [3-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]methanesulphonamidato(2-)-, sodium	83732-91-6	Contains (regardless of intentional or impurities)	chemical products
16764	Sodium [4-hydroxy-3-[[2-hydroxy-1-naphthyl]azo]benzenesulphonamidato(2-)]N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthyl]methanesulphonamidato(2-)]chromate(1-)	83732-92-7	Contains (regardless of intentional or impurities)	chemical products
16765	Sodium bis[3-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]chromate(1-)	83732-93-8	Contains (regardless of intentional or impurities)	chemical products
16766	Chromate(1-), [3-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]N-[8-[[5-(ethylsulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]methanesulphonamidato(2-)-, sodium	83732-94-9	Contains (regardless of intentional or impurities)	chemical products
16767	Chromate(1-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)-], sodium	83732-95-0	Contains (regardless of intentional or impurities)	chemical products
16768	Chromate(1-), bis[3-[[4-[[5-chloro-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-2,4-dimethylbenzenesulfonamidato(2-)]-, sodium	83732-96-1	Contains (regardless of intentional or impurities)	chemical products
16769	Sodium bis[4-[[4,5-dihydro-3-methyl-1-(3-nitrophenyl)-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxybenzene-1-sulphonamidato(2-)]chromate(1-)	83732-97-2	Contains (regardless of intentional or impurities)	chemical products
16770	Lithium bis[3-[[4-[[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]chromate(1-)	83732-98-3	Contains (regardless of intentional or impurities)	chemical products
16771	Sodium [3-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulphonamidato(2-)]-[4-hydroxy-3-[[2-hydroxy-1-naphthyl]azo]benzenesulphonamidato(2-)]chromate(1-)	83733-00-0	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16772	Chromate(1-), [3-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]N-[7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthalenyl]acetamidato(2-)-, sodium	83733-01-1	Contains (regardless of intentional or impurities)	chemical products
16773	Chromate(2-), [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-1-naphthalenesulfonato(3-)]4-[(2-hydroxy-4-nitrophenyl)azo]naphth[2,1-d]-1,3-oxathiol-5-ol-3,3-dioxidato(2-)-, disodium	83733-02-2	Contains (regardless of intentional or impurities)	chemical products
16774	Chromate(2-), [4-[5-chloro-2-hydroxyphenyl)azo]naphth[2,1-d]-1,3-oxathiol-5-ol-3,3-dioxidato(2-)]3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-1-naphthalenesulfonato(3-)-, disodium	83733-03-3	Contains (regardless of intentional or impurities)	chemical products
16775	Chromate(1-), [3-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azobenzenesulfonamidato(2-)]N-[7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthalenyl]acetamidato(2-)-, sodium	83733-04-4	Contains (regardless of intentional or impurities)	chemical products
16776	Lithium bis[N-(7-hydroxy-8-[(2-hydroxy-5-sulphamoylphenyl)azo]-1-naphthyl]acetamidato(2-)]chromate(1-)	83733-05-5	Contains (regardless of intentional or impurities)	chemical products
16777	Lithium bis[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphtholato(2-)]chromate(1-)	83733-06-6	Contains (regardless of intentional or impurities)	chemical products
16778	Lithium [1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphtholato(2-)]1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphtholato(2-)]chromate(1-)	83733-07-7	Contains (regardless of intentional or impurities)	chemical products
16779	Lithium bis[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphtholato(2-)]chromate(1-)	83733-08-8	Contains (regardless of intentional or impurities)	chemical products
16780	Lithium [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphtholato(2-)]chromate(1-)	83733-09-9	Contains (regardless of intentional or impurities)	chemical products
16781	Lithium [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphtholato(2-)]chromate(1-)	83733-10-2	Contains (regardless of intentional or impurities)	chemical products
16782	Lithium bis[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	83733-12-4	Contains (regardless of intentional or impurities)	chemical products
16783	Lithium bis[2-[(2-hydroxy-5-nitrophenyl)azo]-3-oxo-N-phenylbutylamidato(2-)]cobaltate(1-)	83733-13-5	Intentional addition / 1,000ppm	chemical products
16784	Chromate(1-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]N-[8-[5-(ethylsulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]methanesulfonamidato(2-)-, sodium	83733-14-6	Contains (regardless of intentional or impurities)	chemical products
16785	Lithium bis[N-[8-[5-(ethylsulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthyl]methane-1-sulphonamidato(2-)]chromate(1-)	83733-15-7	Contains (regardless of intentional or impurities)	chemical products
16786	Chromate(1-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]N-[8-[5-(ethylsulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]methanesulfonamidato(2-)-, lithium	83733-16-8	Contains (regardless of intentional or impurities)	chemical products
16787	Lithium [2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]N-[8-[5-(ethylsulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthyl]methanesulfonamidato(2-)]chromate(1-)	83733-17-9	Contains (regardless of intentional or impurities)	chemical products
16788	Lithium [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]chromate(1-)	83733-18-0	Contains (regardless of intentional or impurities)	chemical products
16789	Sodium [1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphtholato(2-)]1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphtholato(2-)]chromate(1-)	83733-19-1	Contains (regardless of intentional or impurities)	chemical products
16790	Lithium bis[2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	83733-20-4	Contains (regardless of intentional or impurities)	chemical products
16791	Lithium [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	83733-21-5	Contains (regardless of intentional or impurities)	chemical products
16792	Trisodium bis[4-hydroxy-3-nitro-5-[[2-oxo-1-[(phenylamino)carbonyl]propyl]azo]benzenesulphonato(3-)]cobaltate(3-)	83733-22-6	Intentional addition / 1,000ppm	chemical products
16793	Chromate(2-), [3-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]2-[[2-[(2-hydroxyphenyl)methylene]amino]-4-nitrophenolato(2-)-N2,O1,O2]-, disodium	83733-23-7	Contains (regardless of intentional or impurities)	chemical products
16794	Chromate(2-), [5-chloro-2-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-yl]azo]benzenesulfonic acid S,S-dioxidato(3-)]2-chloro-6-[[2-hydroxyphenyl)methylene]amino]-4-nitrophenolato(2-)-N2,O1,O2]-, disodium	83733-24-8	Contains (regardless of intentional or impurities)	chemical products
16795	Chromate(1-), bis[N-(7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthalenyl]methanesulfonamidato(2-))-, sodium	83748-22-5	Contains (regardless of intentional or impurities)	chemical products
16796	Chromate(3-), [3-[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-, trisodium	83748-23-6	Contains (regardless of intentional or impurities)	chemical products
16797	6,6'-[(3,3-Dimethoxy[1,1'-biphenyl]-4,4'-diyl)azo]bis[4-amino-5-hydroxynaphthalene-1,3-disulphonic acid, sodium salt]	83763-66-0	Intentional addition	chemical products
16798	4-Amino-6-[[4-[(2,4-diamino-5-sulphophenyl)azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-5-hydroxy-3-[[4-nitrophenyl)azo]naphthalene-2,7-disulphonic acid, sodium salt	83763-77-3	Intentional addition	chemical products
16799	4-[[4-[(2,4-Diamino-5-sulphophenyl)azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-3-hydroxynaphthalene-2,7-disulphonic acid, sodium salt	83763-78-4	Intentional addition	chemical products
16800	1-(1-Chloro-1-butenyl)-4-fluorobenzene	83783-53-3	Intentional addition / 1,000ppm	chemical products
16801	2-[2-[(3-Ethyl-5-methylbenzoeselenazol-2(3H)-ylidene)methyl]but-1-enyl]-5,6-dimethyl-3-(3-sulphonatopropyl)benzothiazolium	83783-61-3	Contains (regardless of intentional or impurities)	chemical products
16802	5,5'-Azobidbarbituric acid, barium sodium salt	83784-02-5	Contains (regardless of intentional or impurities)	chemical products
16803	Diammonium pentahydrogen bis[4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-7-[[3-(phosphophenyl)amino]naphthalene-2-sulphonato(5-)]cobaltate(7-)]	83803-62-7	Contains (regardless of intentional or impurities)	chemical products
16804	Triqua[3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]naphthalene-1-sulphonato(3-)]chromium	83803-63-8	Intentional addition / 1,000ppm	chemical products
16805	Sodium [2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]2-[[4,5-dihydro-3-methyl-5-oxo-1-3-sulphamoylphenyl]-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)	83803-64-9	Contains (regardless of intentional or impurities)	chemical products
16806	Sodium bis[3-[[4,5-dihydro-3-methyl-1-(4-nitrophenyl)-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]cobaltate(1-)	83803-65-0	Intentional addition / 1,000ppm	chemical products
16807	Disodium [3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]naphthalene-1-sulphonato(3-)]1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphtholato(2-)]chromate(2-)	83803-66-1	Contains (regardless of intentional or impurities)	chemical products
16808	Disodium [3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]naphthalene-1-sulphonato(3-)]1-[(2-hydroxy-5-methoxyphenyl)azo]-2-naphtholato(2-)]chromate(2-)	83803-68-3	Contains (regardless of intentional or impurities)	chemical products
16809	Triqua[5-[[4-chloro-3-sulphophenyl)azo]-O-salicylato(3-)]chromium	83803-70-7	Intentional addition / 1,000ppm	chemical products
16810	Trisodium bis[3-[[5-amino-3-methyl-1-phenyl-1H-pyrazol-4-yl)azo]-5-chloro-4-hydroxy-N-[2-(sulphoxy)ethyl]benzenesulphonamidato(3-)]cobaltate(3-)]	83804-04-0	Intentional addition / 1,000ppm	chemical products
16811	Copper, bis[N-(2-hydroxyethyl)-N-methylglycinate-N,O1]-	83804-05-1	Intentional addition / 1,000ppm	chemical products
16812	Cobaltate(1-), bis[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]-N-methylbenzenesulfonamidato(2-)]-, sodium	83804-07-3	Intentional addition / 1,000ppm	chemical products
16813	Cobaltate(1-), bis[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]-N-methylbenzenesulfonamidato(2-)]-, lithium	83804-08-4	Intentional addition / 1,000ppm	chemical products
16814	Chromate(1-), bis[4-(2-chloro-4-nitrophenyl)azo]-2-[[2-[(2-hydroxy-5-nitrophenyl)amino]methyl]phenolato(2-)]-, sodium	83804-09-5	Contains (regardless of intentional or impurities)	chemical products
16815	Chromate(1-), bis[4-(2-chloro-4-nitrophenyl)azo]-2-[[2-[(2-hydroxy-5-nitrophenyl)amino]methyl]phenolato(2-)]-, lithium	83804-10-8	Contains (regardless of intentional or impurities)	chemical products
16816	Chromate(1-), bis[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonamidato(2-)]-, lithium	83804-11-9	Contains (regardless of intentional or impurities)	chemical products
16817	Lithium [4-hydroxy-3-[(2-hydroxy-1-naphthyl)azo]benzenesulfonamidato(2-)]N-[7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthyl]acetamidato(2-)]chromate(1-)	83804-12-0	Contains (regardless of intentional or impurities)	chemical products
16818	Chromate(1-), bis[N-(7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthalenyl]acetamidato(2-)]-, lithium	83804-13-1	Contains (regardless of intentional or impurities)	chemical products
16819	Chromate(1-), bis[N-(7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthalenyl]acetamidato(2-)]-, sodium	83804-14-2	Contains (regardless of intentional or impurities)	chemical products
16820	Chromate(1-), bis[2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-, sodium	83804-15-3	Contains (regardless of intentional or impurities)	chemical products
16821	Chromate(1-), [N-(7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthalenyl]acetamidato(2-)]N-[7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthalenyl]methanesulfonamidato(2-)]-, sodium	83804-16-4	Contains (regardless of intentional or impurities)	chemical products
16822	Barium bis[5-[[hexahydro-2,4,6-trioxo-5-pyrimidinyl)azo]-1,4,5,6-tetrahydro-4,6-dioxo-2-pyrimidinyl]cyanamidate	83804-18-6	Contains (regardless of intentional or impurities)	chemical products
16823	[7R-(7.alpha.,7a.beta.,9.beta.,14.alpha.,14a.alpha.)]-Dodecahydro-9-hydroxy-7,14-methano-4H,6H-dipyrido[1,2-a:1',2'-e][1,5]diazocin-4-one monoperchlorate	83817-42-9	Intentional addition / 1,000ppm	chemical products
16824	Cobaltate(1-), [4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonamidato(2-)]4-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-yl]azo]benzenesulfonamidato S,S-dioxidato(2-)]-, sodium	83817-76-9	Intentional addition / 1%	chemical products
16825	Sodium [N-(7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthyl]acetamidato(2-)]2-[[2-[(2-hydroxy-5-sulphamoylphenyl)azo]-3-oxo-N-phenylbutanamidato(2-)]chromate(1-)]	83817-77-0	Contains (regardless of intentional or impurities)	chemical products
16826	Sodium bis[4-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-yl]azo]-N-methylbenzenesulfonamidato S,S-dioxidato(2-)]cobaltate(1-)	83817-78-1	Intentional addition / 1,000ppm	chemical products
16827	Cobaltate(1-), bis[4-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-yl]azo]benzenesulfonamidato S,S-dioxidato(2-)]-, sodium	83817-79-2	Intentional addition / 1%	chemical products
16828	Hexanoic acid, 2-ethyl-, (±)	83829-68-9	Intentional addition / 3,000ppm	chemical products
16829	8-Oxa-3,5-dithia-4-stannadocosanoic acid, 4,4-dibutyl-7-oxo-, tetradecyl ester	83833-21-0	Contains (regardless of intentional or impurities)	chemical products
16830	Tetradecyl 4,4-didodecyl-7-oxo-8-oxa-3,5-dithia-4-stannadocosanoate	83833-23-2	Contains (regardless of intentional or impurities)	chemical products
16831	Tetradecyl 4-dodecyl-7-oxo-8-oxo-[[2-oxo-2-(tetradecyloxy)ethyl]thio]-8-oxa-3,5-dithia-4-stannadocosanoate	83833-24-3	Contains (regardless of intentional or impurities)	chemical products
16832	Decyl 5,5-dibutyl-9-oxo-10-oxa-4,6-dithia-5-stannadocosanoate	83833-25-4	Contains (regardless of intentional or impurities)	chemical products
16833	Decyl 5,5-dioctyl-9-oxo-10-oxa-4,6-dithia-5-stannadocosanoate	83833-26-5	Contains (regardless of intentional or impurities)	chemical products
16834	Decyl 5,5-didodecyl-9-oxo-10-oxa-4,6-dithia-5-stannadocosanoate	83833-27-6	Contains (regardless of intentional or impurities)	chemical products
16835	Decyl 5-butyl-5-[[3-(decyloxy)-3-oxopropyl]thio]-9-oxo-10-oxa-4,6-dithia-5-stannadocosanoate	83833-28-7	Contains (regardless of intentional or impurities)	chemical products
16836	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]4-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)-, disodium	83833-37-8	Contains (regardless of intentional or impurities)	chemical products
16837	Chromium, hydroxybis(2-hydroxybenzoato-O1,O2)-, ar.ar'-di-C13-alkyl derivatives	83846-44-0	Intentional addition / 1,000ppm	chemical products
16838	Diisooctyl 3,3'-[[dichloroethyl]stannylene]bis(thio)diopropionate	83846-45-1	Contains (regardless of intentional or impurities)	chemical products
16839	Ammonium bis[4-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-yl]azo]-N-methylbenzenesulfonamidato S,S-dioxidato(2-)]cobaltate(1-)	83847-05-6	Intentional addition / 1,000ppm	chemical products
16840	Cobaltate(1-), bis[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]-N-methylbenzenesulfonamidato(2-)]-, ammonium	83847-06-7	Intentional addition / 1,000ppm	chemical products
16841	Phosphoric acid, vanadium(3+) salt (1:1), hydrate	83852-52-2	Intentional addition / 1%	chemical products
16842	Sodium [3-[[5-(3-amino-4-nitrophenyl)azo]-2,4-dihydroxyphenyl]azo]-2-hydroxybenzenesulphonato(3-)]cuprate(1-)	83863-34-7	Intentional addition / 1,000ppm	chemical products
16843	Trisodium bis[5-chloro-3-[[1-(2-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulphonato(3-)]chromate(3-)	83863-35-8	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16844	Sodium triaqu[3-hydroxy-4-[[1-(hydroxy-8-sulpho-2-naphthyl)azo]naphthalene-1-sulphonato(4-)]chromate(1-)]	83863-36-9	Contains (regardless of intentional or impurities)	chemical products
16845	Sodium triaqu[5-[[5-(chloro-2-hydroxy-3-sulphophenyl)azo]-6-hydroxynaphthalene-2-sulphonato(4-)]chromate(1-)]	83863-37-0	Contains (regardless of intentional or impurities)	chemical products
16846	Sodium triaqu[4-hydroxy-3-[[2-hydroxy-5-sulphophenyl)azo]naphthalene-1-sulphonato(4-)]chromate(1-)]	83863-38-1	Contains (regardless of intentional or impurities)	chemical products
16847	Triaqu[3-[[1,5-dihydroxy-2-naphthyl)azo]-4-hydroxy-5-nitrobenzene-1-sulphonato(3-)]chromium	83863-39-2	Intentional addition / 1,000ppm	chemical products
16848	Bis[N,N-dimethylpropane-1,3-diamine-N'][(2,3,10,16,17,23,24-octahydro-29H,31H-tetrakis[1,4]dithiolo[2,3-b:2',3'-b']-2,2'-bipyrazol-2-yl)-N29,N30,N31,N32]cobalt	83863-97-2	Intentional addition / 1,000ppm	chemical products
16849	Bis[N,N-dimethylpropane-1,3-diamine-N'][(2,3,10,16,17,23,24-octahydro-29H,31H-tetrakis[1,4]dithiolo[2,3-b:2',3'-b']-2,2'-bipyrazol-2-yl)-N29,N30,N31,N32]cobalt	83863-98-3	Intentional addition / 1,000ppm	chemical products
16850	Nickel bis[[cyano-C]triphenylborato(1-)]bis[hexanedinitrile-N,N']	83864-02-2	Contains (regardless of intentional or impurities)	chemical products
16851	Cobaltate(1-), bis[4-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-yl)azo]benzenesulfonamide S,S-dioxidato(2-)]-, ammonium	83864-23-7	Intentional addition / 1%	chemical products
16852	Cobaltate(1-), [4-hydroxy-3-[[2-hydroxy-1-naphthalenyl)azo]benzenesulfonamidato(2-)]-[4-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-yl)azo]benzenesulfonamide S,S-dioxidato(2-)]-, ammonium	83864-24-8	Intentional addition / 1%	chemical products
16853	Manganese, [3-hydroxy-4-[[2-methyl-4-sulphophenyl)azo]-2-naphthalene-carboxylato(2-)-O2,O3]-	83864-26-0	Contains (regardless of intentional or impurities)	chemical products
16854	Decyl 5-[[3-(decyloxy)-3-oxopropyl]thio]-5-octyl-9-oxo-10-oxa-4,6-dithia-5-stannadecanoate	83898-44-6	Contains (regardless of intentional or impurities)	chemical products
16855	Decyl 5-[[3-(decyloxy)-3-oxopropyl]thio]-5-dodecyl-9-oxo-10-oxa-4,6-dithia-5-stannaicosanoate	83898-45-7	Contains (regardless of intentional or impurities)	chemical products
16856	Dodecyl 5,5-didodecyl-9-oxo-10-oxa-4,6-dithia-5-stannadecanoate	83898-46-8	Contains (regardless of intentional or impurities)	chemical products
16857	Tetradecyl 5-butyl-9-oxo-5-[[3-oxo-3-(tetradecyloxy)propyl]thio]-10-oxa-4,6-dithia-5-stannatetracosanoate	83898-47-9	Contains (regardless of intentional or impurities)	chemical products
16858	Tetradecyl 5-octyl-9-oxo-5-[[3-oxo-3-(tetradecyloxy)propyl]thio]-10-oxa-4,6-dithia-5-stannatetracosanoate	83898-48-0	Contains (regardless of intentional or impurities)	chemical products
16859	Tetradecyl 5-dodecyl-9-oxo-5-[[3-oxo-3-(tetradecyloxy)propyl]thio]-10-oxa-4,6-dithia-5-stannatetracosanoate	83898-49-1	Contains (regardless of intentional or impurities)	chemical products
16860	Tetradecyl 5,5-didodecyl-9-oxo-10-oxa-4,6-dithia-5-stannatetracosanoate	83898-50-4	Contains (regardless of intentional or impurities)	chemical products
16861	Dodecyl 5-dodecyl-5-[[3-(dodecyloxy)-3-oxopropyl]thio]-9-oxo-10-oxa-4,6-dithia-5-stannadecanoate	83898-51-5	Contains (regardless of intentional or impurities)	chemical products
16862	Dodecyl 5-butyl-5-[[3-(dodecyloxy)-3-oxopropyl]thio]-9-oxo-10-oxa-4,6-dithia-5-stannadecanoate	83898-52-6	Contains (regardless of intentional or impurities)	chemical products
16863	Tetradecyl 5,5-dioctyl-9-oxo-10-oxa-4,6-dithia-5-stannatetracosanoate	83898-53-7	Contains (regardless of intentional or impurities)	chemical products
16864	Decyl (al-Z)-6-[[4-(decyloxy)-1,4-dioxobut-2-enyl]oxy]-6-octyl-4,8,11-trioxo-5,7,12-trioxa-6-stannadecosa-2,9-dienoate	83898-54-8	Contains (regardless of intentional or impurities)	chemical products
16865	Decyl (Z,Z)-6-[[4-(decyloxy)-1,4-dioxobut-2-enyl]oxy]-6-dodecyl-4,8,11-trioxo-5,7,12-trioxa-6-stannadecosa-2,9-dienoate	83898-55-9	Contains (regardless of intentional or impurities)	chemical products
16866	Decyl (Z,Z)-6-butyl-6-[[4-(decyloxy)-1,4-dioxobut-2-enyl]oxy]-4,8,11-trioxo-5,7,12-trioxa-6-stannadecosa-2,9-dienoate	83898-56-0	Contains (regardless of intentional or impurities)	chemical products
16867	Decyl (Z,Z)-6,6-didodecyl-4,8,11-trioxo-5,7,12-trioxa-6-stannadecosa-2,9-dienoate	83898-57-1	Contains (regardless of intentional or impurities)	chemical products
16868	Decyl (Z,Z)-6,6-dioctyl-4,8,11-trioxo-5,7,12-trioxa-6-stannadecosa-2,9-dienoate	83898-58-2	Contains (regardless of intentional or impurities)	chemical products
16869	Dodecyl (Z,Z)-6-dodecyl-6-[[4-(dodecyloxy)-1,4-dioxobut-2-enyl]oxy]-4,8,11-trioxo-5,7,12-trioxa-6-stannatetracosanoate	83898-59-3	Contains (regardless of intentional or impurities)	chemical products
16870	Methyl (Z,Z)-8,8-didodecyl-3,6,10-trioxo-2,7,9-trioxa-8-stannatrideca-4,11-dien-13-ate	83898-60-6	Contains (regardless of intentional or impurities)	chemical products
16871	(Ethyl)enediamine-N(1)imino-1H-isoxadol-3-aminato-N(2)[29H,31H-phthalocyaninato-N29,N30,N31,N32]cobalt	83898-69-5	Intentional addition / 1,000ppm	chemical products
16872	Dimethoxy[29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]nickel	83898-70-8	Contains (regardless of intentional or impurities)	chemical products
16873	1-Chloro-4-[[4-(chloro-1-(4-fluorophenyl)-1-butyl)benzene	83899-31-1	Intentional addition / 1,000ppm	chemical products
16874	2,2',3,3',5,5',6'-Octabromo-4-phenoxy-1,1'-biphenyl	83899-89-5	Intentional addition / 1,000ppm	chemical products
16875	Undecabromotriphenyl	83899-90-0	Intentional addition / 1,000ppm	chemical products
16876	C.I. Disperse Yellow 218	83899-90-2	Intentional addition / 1,000ppm	chemical products
16877	Manganese(2+) disulphamate	83899-95-7	Contains (regardless of intentional or impurities)	chemical products
16878	L-Alanine, 4-(hydroxymethyl)phosphinyll-2-aminobutanoyl-L-alanyl-, trisodium salt	83935-12-0	Intentional addition	chemical products
16879	(E)-2-Phenylethylene-1-boronic acid, pinacol ester	83947-56-2	Intentional addition / 1%	chemical products
16880	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]N-[8-[[5-(ethylsulfonyl)-2-hydroxyphenyl)azo]-7-hydroxy-1-naphthalenyl]methanesulfonamidato(2-)]-, hydrogen, compound with 2-aminoethanol (1:1)	83949-51-3	Contains (regardless of intentional or impurities)	chemical products
16881	Chromate(1-), [2-[[4-(5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]N-[8-[[5-(ethylsulfonyl)-2-hydroxyphenyl)azo]-7-hydroxy-1-naphthalenyl]methanesulfonamidato(2-)]-, hydrogen, compound with 2-aminoethanol (1:1)	83949-53-5	Contains (regardless of intentional or impurities)	chemical products
16882	Hydrogen bis[N-[8-[[5-(ethylsulfonyl)-2-hydroxyphenyl)azo]-7-hydroxy-1-naphthyl]methane-1-sulphonamidato(2-)]chromate(1-)], compound with 2-aminoethanol (1:1)	83949-54-6	Contains (regardless of intentional or impurities)	chemical products
16883	Chromate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]N-[2-[[4-(5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]-, hydrogen, compound with 2-aminoethanol (1:1)	83949-55-7	Contains (regardless of intentional or impurities)	chemical products
16884	Hydrogen bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)], compound with 2-aminoethanol (1:1)	83949-56-8	Contains (regardless of intentional or impurities)	chemical products
16885	Octasodium [mu-[[3,3'-azobis[8-hydroxy-7-[[2-hydroxy-3,6-disulpho-1-naphthyl)azo]naphthalene-1,5-disulphonato]](12-)]dicuprate(8-)]	83949-57-9	Intentional addition / 1,000ppm	chemical products
16886	Tetrasodium [7-[[6-[[5-(chloro-2,6-difluoro-4-pyrimidinyl)amino]-1-hydroxy-3-sulpho-2-naphthyl)azo]-8-hydroxynaphthalene-1,3,5-trisulphonato(6-)]cuprate(4-)]	83949-58-0	Intentional addition / 1,000ppm	chemical products
16887	Chromate(1-), bis[3-[[4-[[5-(chloro-2-hydroxy-3-nitrophenyl)azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-2,4-dimethylbenzenesulfonamidato(2-)]-, hydrogen, compound with 2-aminoethanol (1:1)	83949-59-1	Contains (regardless of intentional or impurities)	chemical products
16888	Lithium bis[2-[[4-(5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]chromate(1-)]	83949-60-4	Contains (regardless of intentional or impurities)	chemical products
16889	Hydrogen bis[2-[[4-(5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]chromate(1-)], compound with 2,2,2'-nitrioltris[ethanol] (1:1)	83949-61-5	Contains (regardless of intentional or impurities)	chemical products
16890	Tetrasodium [mu-[[7,7'-iminobis[3-[[3-(chloro-2-hydroxy-5-sulphophenyl)azo]-4-hydroxynaphthalene-2-sulphonato]](8-)]dicuprate(4-)]	83951-72-8	Intentional addition / 1,000ppm	chemical products
16891	Cobalt bis[romylphenolate]	83970-30-3	Intentional addition / 1,000ppm	chemical products
16892	Pentasodium bis[5-[[4-(chloro-6-methoxy-1,3,5-triazin-2-yl)amino]-2-[[1-hydroxy-3-sulpho-7-(3-sulphoamino)-2-naphthyl)azo]benzoato(4-)]chromate(5-)]	83984-90-1	Contains (regardless of intentional or impurities)	chemical products
16893	Sulphuric acid, ammonium chromium sodium salt	84000-95-3	Intentional addition / 1,000ppm	chemical products
16894	Oxalic acid, ammonium sodium salt	84000-96-4	Intentional addition / 1,000ppm	chemical products
16895	Copper, [N,N'-tributyl-29H,31H-phthalocyaninetrisulfonamidato(2-)-N29,N30,N31,N32]-, butoxysulfonyl derivatives	84012-10-2	Intentional addition / 1,000ppm	chemical products
16896	Indium tris[1R-(1.alpha.,4.alpha.,4.alpha.,10.alpha.)-1,2,3,4,4a,5,6,10,10a-decahydro-7-isopropyl-1,4a-dimethylphenanthren-1-carboxylate]	84012-59-9	Intentional addition / 1%	chemical products
16897	N-Nitroso-N-((tributylstannyloxy)cyclohexyl)amine	84012-65-7	Contains (regardless of intentional or impurities)	chemical products
16898	Butyl (Z,Z)-6,6-didodecyl-4,8,11-trioxo-5,7,12-trioxa-6-stannahexadeca-2,9-dienoate	84012-66-8	Contains (regardless of intentional or impurities)	chemical products
16899	Hydrobis(2,4,4-trimethylpentyl)aluminium	84012-67-9	Intentional addition / 1,000ppm	chemical products
16900	o-[[[tributylstannyloxy]carbonyl]phenyl acetate	84029-40-3	Contains (regardless of intentional or impurities)	chemical products
16901	Benzene, 1-methyl-3,7-dinitro-	84029-41-4	Intentional addition / 1%	chemical products
16902	Benzene, 1-methyl-2,7-dinitro-	84029-42-5	Intentional addition / 1%	chemical products
16903	Trisooctyl 4,4',4''-[[dodecylstannylidene]tris(oxy)]tris[4-oxoisocrotonate]	84029-62-9	Contains (regardless of intentional or impurities)	chemical products
16904	Trisooctyl 4,4',4''-[[octylstannylidene]tris(oxy)]tris[4-oxoisocrotonate]	84029-63-0	Contains (regardless of intentional or impurities)	chemical products
16905	Diisooctyl 4,4''-[[didodecylstannylidene]bis(oxy)]bis[4-oxoisocrotonate]	84029-64-1	Contains (regardless of intentional or impurities)	chemical products
16906	Dodecyl (Z,Z)-6,6-didodecyl-4,8,11-trioxo-5,7,12-trioxa-6-stannatetracosanoate-2,9-dienoate	84029-72-1	Contains (regardless of intentional or impurities)	chemical products
16907	Tetradecyl (Z,Z)-6-[[[1,4-dioxo-4-(tetradecyloxy)but-2-enyl]oxy]-6-octyl-4,8,11-trioxo-5,7,12-trioxa-6-stannahexadeca-2,9-dienoate	84029-73-2	Contains (regardless of intentional or impurities)	chemical products
16908	Tetradecyl (Z,Z)-6-[[[1,4-dioxo-4-(tetradecyloxy)but-2-enyl]oxy]-6-dodecyl-4,8,11-trioxo-5,7,12-trioxa-6-stannahexadeca-2,9-dienoate	84029-74-3	Contains (regardless of intentional or impurities)	chemical products
16909	Tetradecyl (Z,Z)-6-butyl-6-[[[1,4-dioxo-4-(tetradecyloxy)but-2-enyl]oxy]-4,8,11-trioxo-5,7,12-trioxa-6-stannahexadeca-2,9-dienoate	84029-75-4	Contains (regardless of intentional or impurities)	chemical products
16910	Tetradecyl (Z,Z)-6,6-didodecyl-4,8,11-trioxo-5,7,12-trioxa-6-stannahexadeca-2,9-dienoate	84029-76-5	Contains (regardless of intentional or impurities)	chemical products
16911	Tetradecyl (Z,Z)-6,6-dioctyl-4,8,11-trioxo-5,7,12-trioxa-6-stannahexadeca-2,9-dienoate	84029-77-6	Contains (regardless of intentional or impurities)	chemical products
16912	Ethyl (Z,Z)-9-dodecyl-9-[[4-ethoxy-1,4-dioxobut-2-enyl]oxy]-4,7,11-trioxo-3,8,10-trioxa-9-stannatetradeca-5,12-dien-14-ate	84029-78-7	Contains (regardless of intentional or impurities)	chemical products
16913	Ethyl (Z)-9,9-didodecyl-4,7,11-trioxo-3,8,10-trioxa-9-stannatetradeca-5,12-dien-14-ate	84029-79-8	Contains (regardless of intentional or impurities)	chemical products
16914	Ethyl (Z,Z)-9-butyl-9-[[4-ethoxy-1,4-dioxobut-2-enyl]oxy]-4,7,11-trioxo-3,8,10-trioxa-9-stannatetradeca-5,12-dien-14-ate	84029-80-1	Contains (regardless of intentional or impurities)	chemical products
16915	Butyl (Z,Z)-6-[[4-butoxy-1,4-dioxobut-2-enyl]oxy]dodec-6-yl-4,8,11-trioxo-5,7,12-trioxa-6-stannahexadeca-2,9-dienoate	84029-81-2	Contains (regardless of intentional or impurities)	chemical products
16916	[3-(4,5-Dihydro-3-methyl-5-oxo-1-(4-sulphonatophenyl)-1H-pyrazol-4-yl)azo]naphthalene-1,5-disulphonic acid, barium salt	84029-82-3	Contains (regardless of intentional or impurities)	chemical products
16917	Iron(2+) triocetyl triphosphonate	84030-25-1	Intentional addition / 1%	chemical products
16918	Iron(3+) triocetyl triphosphonate	84030-28-2	Intentional addition / 1%	chemical products
16919	6-Chloro-4-[[2-hydroxy-1-naphthyl)azo]toluene-3-sulphonic acid, barium salt	84030-33-1	Contains (regardless of intentional or impurities)	chemical products
16920	2-Chloro-5-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulphophenyl)-1H-pyrazol-4-yl)azo]toluene-4-sulphonic acid, barium salt	84030-37-5	Contains (regardless of intentional or impurities)	chemical products
16921	3-[[2-Hydroxy-1-naphthyl)azo]naphthalene-1,5-disulphonic acid, barium salt	84030-38-6	Contains (regardless of intentional or impurities)	chemical products
16922	[[4,5-Dihydro-3-methyl-5-oxo-1-(4-sulphophenyl)-1H-pyrazol-4-yl)azo]naphthalene-1-sulphonic acid, barium salt	84030-39-7	Contains (regardless of intentional or impurities)	chemical products
16923	Manganese 3-hydroxy-4-[[4-methyl-2-sulphonatophenyl)azo]-2-naphthoate	84030-40-0	Contains (regardless of intentional or impurities)	chemical products
16924	Dodecyl 4-dodecyl-4-[[2-(dodecyloxy)-2-oxoethyl]thio]-7-oxo-8-oxa-3,5-dithia-4-stannaicosanoate	84030-41-1	Contains (regardless of intentional or impurities)	chemical products
16925	Decyl 4,4-didodecyl-7-oxo-8-oxa-3,5-dithia-4-stannaoctadecanoate	84030-42-2	Contains (regardless of intentional or impurities)	chemical products
16926	Decyl 4-[[2-(decyloxy)-2-oxoethyl]thio]-4-dodecyl-7-oxo-8-oxa-3,5-dithia-4-stannaotadecanoate	84030-43-3	Contains (regardless of intentional or impurities)	chemical products
16927	Decyl 4-[[2-(decyloxy)-2-oxoethyl]thio]-4-octyl-7-oxo-8-oxa-3,5-dithia-4-stannaotadecanoate	84030-44-4	Contains (regardless of intentional or impurities)	chemical products
16928	Decyl 4,4-dibutyl-7-oxo-8-oxa-3,5-dithia-4-stannaotadecanoate	84030-45-5	Contains (regardless of intentional or impurities)	chemical products
16929	Decyl 4-butyl-4-[[2-(decyloxy)-2-oxoethyl]thio]-7-oxo-8-oxa-3,5-dithia-4-stannaotadecanoate	84030-46-6	Contains (regardless of intentional or impurities)	chemical products
16930	Decyl 4,4-dioctyl-7-oxo-8-oxa-3,5-dithia-4-stannaotadecanoate	84030-47-7	Contains (regardless of intentional or impurities)	chemical products
16931	Decyl hydrogen sulphate, compound with 4,4'-carbonimidoylbis[N,N-dimethylaniline] (1:1)	84030-53-5	Contains (regardless of intentional or impurities)	chemical products
16932	Trihydrogen bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzene-1-sulphonato(3-)]chromate(3-)], compound with cyclohexanol (1:3)	84030-54-6	Contains (regardless of intentional or impurities)	chemical products
16933	Chromate(1-), diaquabis[3-hydroxy-2-naphthalene-carboxylato(2-)-O2,O3]-, hydrogen	84030-55-7	Contains (regardless of intentional or impurities)	chemical products
16934	Hydrogen bis[1-[[6-hydroxy-5-nitro-m-tolyl)azo]-2-naphtholato(2-)]chromate(1-)], compound with 2,2'-(dodecylimino)diethanol (1:1)	84030-57-9	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
16935	Hydrogen bis[2-[[2-(2-hydroxy-5-nitrophenyl)azo]-3-oxo-N-phenylbutylamido(2-)]cobaltate(1-), compound with 2,2'-dodecyliminobis[ethanol] (1:1)	84030-58-0	Intentional addition / 1,000ppm	chemical products
16936	Hydrogen bis[2,4-dihydro-4-[[2-(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]cobaltate(1-)	84030-59-1	Intentional addition / 1,000ppm	chemical products
16937	Disoocetyl 2,2'-[[didodecylstannylene]bis(thio)]diacetate	84030-61-5	Contains (regardless of intentional or impurities)	chemical products
16938	Chromate(1-), bis[2-[[1-(2-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]-, hydrogen, compound with 2-aminoethanol (1:1)	84030-63-7	Contains (regardless of intentional or impurities)	chemical products
16939	Barium bis[(±)-1-[[[methoxyoxido]phosphoryl]oxy]methyl]-2-[[1-(oxohexadecyl)oxy]ethyl] dioleate	84040-38-0	Contains (regardless of intentional or impurities)	chemical products
16940	2-Naphthalenecarboxylic acid, 4-[[4-chloro-5-methyl-2-sulphophenyl]azo]-3-hydroxy- manganese salt	84041-69-0	Contains (regardless of intentional or impurities)	chemical products
16941	Methanaminium, N-[4-[[4-[[dimethylamino]phenyl][4-(methylphenylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-methyl-, [29H,31H-phthalocyaninetrilsulfonato(5-)-N29,N30,N31,N32]cuprate(3-)(3:1)	84049-36-5	Intentional addition / 1,000ppm	chemical products
16942	Acetoxy[2-[[2-(2-aminoethylamino)propoxy]dibutyltin	84051-94-5	Contains (regardless of intentional or impurities)	chemical products
16943	Potassium hydrogen [2-[[[alpha-[[2-hydroxy-5-[[3-(sulphoanilino)sulphonyl]phenyl]azo]benzyl]azo]benzoato(4-)]cuprate(2-)	84057-70-5	Intentional addition / 1,000ppm	chemical products
16944	Trisodium hydrogen [2-[[[alpha-[[3-[[4-chloro-6-[[ethyl[3-[[2-(sulphoxy)ethyl]sulphonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulphophenyl]azo]benzyl]azo]-4-sulphobenzoato(6-)]cuprate(4-)	84057-71-6	Intentional addition / 1,000ppm	chemical products
16945	Trisodium bis[6-amino-5-[[2-hydroxy-3,5-dinitrophenyl]azo]naphthalene-1-sulphonato(3-)]cobaltate(3-)	84057-73-8	Intentional addition / 1,000ppm	chemical products
16946	Trisodium [3-[[8-acetamido-2-hydroxy-1-naphthyl]azo]-2-hydroxy-5-nitrobenzenesulphonato(3-)](3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]chromate(3-)	84057-74-9	Contains (regardless of intentional or impurities)	chemical products
16947	Oxalic acid, ammonium zirconium salt	84057-78-3	Contains (regardless of intentional or impurities)	chemical products
16948	Phosphoric acid, ammonium zirconium salt	84057-79-4	Contains (regardless of intentional or impurities)	chemical products
16949	Propanoic acid, zirconium salt	84057-80-7	Contains (regardless of intentional or impurities)	chemical products
16950	Zirconium methacrylate	84057-81-8	Contains (regardless of intentional or impurities)	chemical products
16951	Thallium triarsenide	84057-85-2	Contains (regardless of intentional or impurities)	chemical products
16952	Barium, C5-23-branched carboxylate C4-10-fatty acid complexes	84066-73-9	Intentional addition / 1,000ppm	chemical products
16953	Barium, C5-23-branched carboxylate octanoate complexes	84066-74-0	Intentional addition / 1,000ppm	chemical products
16954	Barium, C4-10-fatty acid naphthenate complexes	84066-75-1	Contains (regardless of intentional or impurities)	chemical products
16955	Cobalt, C5-23-branched carboxylate C4-10-fatty acid complexes	84066-83-1	Intentional addition / 1%	chemical products
16956	Cobalt, C5-23-branched carboxylate octanoate complexes	84066-84-2	Intentional addition / 1%	chemical products
16957	Cobalt, C4-10-fatty acid naphthenate complexes	84066-85-3	Intentional addition / 1,000ppm	chemical products
16958	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[2-[[4-chloro-6-[[3-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]ethyl]amino]sulfonyl sulfo derivatives, sodium salts	84066-86-4	Intentional addition / 1,000ppm	chemical products
16959	Zirconium, C5-23-branched carboxylate C4-10-fatty acid complexes	84067-12-9	Contains (regardless of intentional or impurities)	chemical products
16960	Zirconium, C5-23-branched carboxylate C4-10-fatty acid naphthenate complexes	84067-13-0	Contains (regardless of intentional or impurities)	chemical products
16961	Zirconium, C5-23-branched carboxylate octanoate complexes	84067-14-1	Contains (regardless of intentional or impurities)	chemical products
16962	Propane-1,2,3-triol, sodium zirconium salt	84074-44-2	Contains (regardless of intentional or impurities)	chemical products
16963	Oxalic acid, sodium zirconium salt	84074-45-3	Contains (regardless of intentional or impurities)	chemical products
16964	Sodium bis[3-[[4,5-dihydro-3-methyl-1-(4-nitrophenyl)-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzene-1-sulphonamidato(2-)]chromate(1-)	84074-46-4	Contains (regardless of intentional or impurities)	chemical products
16965	(Z)-4-Chloro-2-[[[2-methoxycarbonyl]methoxy]imino]-3-oxobutyrac acid	84080-70-6	Contains (regardless of intentional or impurities)	chemical products
16966	Copper(II) isooctanoate	84082-87-1	Intentional addition / 1,000ppm	chemical products
16967	Copper(II) isodecanoate	84082-88-2	Intentional addition / 1,000ppm	chemical products
16968	(Isononanoato-O)(isooctanoato-O)copper	84082-89-3	Intentional addition / 1,000ppm	chemical products
16969	(Isodecanoato-O)(isooctanoato-O)copper	84082-90-6	Intentional addition / 1,000ppm	chemical products
16970	(Isodecanoato-O)(isononanoato-O)copper	84082-91-7	Intentional addition / 1,000ppm	chemical products
16971	(Isodecanoato-O)(neodecanoato-O)copper	84082-92-8	Intentional addition / 1,000ppm	chemical products
16972	Cuprate(3-), [5-(acetylamino)-4-hydroxy-3-[[2-[[2-sulfoxy]ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(5-)]-, trisodium	84082-95-1	Intentional addition / 1,000ppm	chemical products
16973	Cobaltate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)](3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, sodium	84082-96-2	Intentional addition / 1%	chemical products
16974	Sodium [N-[8-[[5-(N-ethylsulfamoyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthyl]acetamidato(2-)](N-[7-hydroxy-8-[[2-(2-hydroxy-5-nitrophenyl)azo]-1-naphthyl]acetamidato(2-)]chromate(1-)	84082-98-4	Contains (regardless of intentional or impurities)	chemical products
16975	Sodium bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulphamoylphenyl)-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)	84082-99-5	Contains (regardless of intentional or impurities)	chemical products
16976	5-Chloro-4-(cyclohexylmethylamino)-2-(trifluoromethyl)benzenediazonium tetrafluoroborate	84083-13-6	Intentional addition / 1%	chemical products
16977	3-Chloro-4-(cyclohexylmethylamino)benzenediazonium tetrafluoroborate	84083-14-7	Intentional addition / 1%	chemical products
16978	Sodium [N-[8-[[5-(chloro-2-hydroxyphenyl)azo]-7-hydroxy-1-naphthyl]acetamidato(2-)](N-[8-[[5-(ethylamino)sulphonyl]-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthyl]acetamidato(2-)]chromate(1-)	84089-97-8	Contains (regardless of intentional or impurities)	chemical products
16979	Tetrahydrogen bis[8-hydroxyquinoline-5,7-disulphonato(3-)-O7,O8]cuprate(4-), compound with diethylamine (1:4)	84100-66-3	Intentional addition / 1,000ppm	chemical products
16980	4-Amino-3-[[4-[[2-(4-diaminophenyl)azo]-3,3-dimethoxy[1,1'-biphenyl]-4-yl]azo]-5-hydroxy-6-(phenylazo)naphthalene-2,7-disulphonic acid, potassium sodium salt	84100-78-7	Intentional addition	chemical products
16981	Boronic acid, B-(2-methylpropyl)-	84110-40-7	Intentional addition / 1%	chemical products
16982	(Isononanoato-O)(neodecanoato-O)copper	84129-18-0	Intentional addition / 1,000ppm	chemical products
16983	(Isodecanoato-O)(neodecanoato-O)copper	84129-19-1	Intentional addition / 1,000ppm	chemical products
16984	Ethyl 1-fluoro-2-oxocyclopentanecarboxylate	84131-44-2	Intentional addition / 1%	chemical products
16985	Alcohols, C12-14-secondary, ethoxylated	84133-50-6	Intentional addition / 1%	chemical products
16986	1-Propanesulfonic acid, 2-hydroxy-, tin(2+) salt (2:1)	84142-17-7	Intentional addition / 1,000ppm	chemical products
16987	Ashes (residues), vanadium-containing - Flue dust and ash containing vanadium resulting from the combustion of vanadium-bearing fuel oil.	84144-87-6	Intentional addition / 1%	chemical products
16988	Leach residues, molybdenum roasted ore, ammonium	84144-89-8	Intentional addition / 1,000ppm	chemical products
16989	Leach residues, molybdenum roasted ore, carbamate - Residues from basic leaching of roasted molybdenum ores. Composed primarily of salts of copper, iron and molybdenum with silica and traces of ferric carbamate.	84144-90-1	Contains (regardless of intentional or impurities)	chemical products
16990	Leach residues, molybdenum roasted ore, lime - Residues from leaching roasted molybdenum ores. Composed primarily of impure calcium molybdate and other hydroxides, primarily iron hydroxides.	84144-91-2	Intentional addition / 1,000ppm	chemical products
16991	Leach residues, tin-tungsten ore - Residues from the basic leaching of tin-bearing tungsten ores. Composed primarily of silica and insoluble compounds of manganese, tin and tungsten.	84144-93-4	Contains (regardless of intentional or impurities)	chemical products
16992	Slags, chromium-manufacturing, aluminothermic - Product of aluminothermic reduction of chromium oxide. Composed primarily of fused oxides of aluminum, calcium and chromium.	84144-94-5	Intentional addition / 1,000ppm	chemical products
16993	Slags, ferromolybdenum-manufacturing, silicothermic - Product of silicothermic reduction of molybde oxide. Composed primarily of fused silica, alumina, and calcium and iron oxides and silicates, with a small amount of residual molybdenum.	84144-95-6	Intentional addition / 1,000ppm	chemical products
16994	Slags, ferrovandium-manufacturing, aluminothermic - Product of aluminothermic reduction of vanadium oxide and iron oxide, composed primarily of fused oxides of aluminum, calcium, iron and vanadium.	84144-98-9	Intentional addition / 1%	chemical products
16995	Slags, manganese-manufacturing, aluminothermic - Product of aluminothermic reduction of manganese oxides. Composed primarily of fused oxides of aluminum, calcium and manganese.	84144-99-0	Contains (regardless of intentional or impurities)	chemical products
16996	2-[[Trimethylstannyl]thio]ethyl stearate	84145-12-0	Contains (regardless of intentional or impurities)	chemical products
16997	Tetrakis(decanoato-O)cobalt]tetra-mu-oxotitanium	84145-31-3	Intentional addition / 1,000ppm	chemical products
16998	Cuprate(5-), [2-[[[[3-[[4-[[2-carboxyethyl]3-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]amino]-6-chloro-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulphophenyl]azo]phenylmethyl]azo]-4-sulfobenzoato(7-)]-, trisodium dihydrogen	84145-36-8	Intentional addition / 1,000ppm	chemical products
16999	1-(4-Methoxyphenyl)piperazinium chloride	84145-43-7	Intentional addition	chemical products
17000	Cuprate(3-), [2-[[[3-hydroxy-4-[[1-hydroxy-3-sulfo-7-[[3-sulphophenyl]amino]-2-naphthalenyl]azo]phenyl]azo]phenyl]-6-methyl-7-benzothiazolesulfonato(5-)]-, trisodium	84145-48-2	Intentional addition / 1,000ppm	chemical products
17001	3,7-Diaminophenothiazin-5-ium tetrafluoroborate	84145-75-5	Intentional addition / 1%	chemical products
17002	(1,2-Dimethyl-1H-imidazole-N3)trifluoroboron	84145-77-7	Intentional addition / 1%	chemical products
17003	3,7-Diaminophenothiazin-5-ium tetrafluoroborate	84145-78-8	Intentional addition / 1%	chemical products
17004	3-(Dimethylamino)-7-(methylamino)phenothiazin-5-ium tetrafluoroborate	84145-81-3	Intentional addition / 1%	chemical products
17005	7-Amino-3-(ethylamino)-2-methylphenoxazin-5-ium perchlorate	84145-83-5	Intentional addition / 1,000ppm	chemical products
17006	Orthoboric acid, compound with N-(2-aminoethyl)-N'-[2-[[2-(2-aminoethyl)amino]ethyl]ethylenediamine	84145-84-6	Intentional addition / 1%	chemical products
17007	Chromate(2-), [2-hydroxy-3-[[2-(2-hydroxy-1-naphthalenyl)azo]-5-nitrobenzenesulfonato(3-)](1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)])-, disodium	84145-95-9	Contains (regardless of intentional or impurities)	chemical products
17008	Dichlorobis(2-methyl-5-nitro-1H-imidazole-1-ethanol-N3)platinum	84151-71-3	Contains (regardless of intentional or impurities)	chemical products
17009	Tetrakis(octanoato-O)cobalt]tetra-mu-oxotitanium	84176-59-0	Intentional addition / 1,000ppm	chemical products
17010	Chromate(1-), bis[3-hydroxy-4-[[2-(2-hydroxy-3,5-dinitrophenyl)azo]-N-phenyl-2-naphthalenecarboxamidato(2-)]-, hydrogen	84179-66-8	Contains (regardless of intentional or impurities)	chemical products
17011	2-Pentene, 2-bromo-4-methyl-, (Z)-	84189-15-1	Intentional addition / 1,000ppm	chemical products
17012	Hydrogen bis[1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphtholato(2-)]chromate(1-), compound with 2,2'-(dodecylimino)diethanol (1:1)	84195-80-2	Contains (regardless of intentional or impurities)	chemical products
17013	Hydrogen bis[1-[[2-(2-hydroxy-5-nitrophenyl)azo]-2-naphtholato(2-)]chromate(1-), compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84195-81-3	Contains (regardless of intentional or impurities)	chemical products
17014	Hydrogen [1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphtholato(2-)](1-[[2-(2-hydroxy-5-nitrophenyl)azo]-2-naphtholato(2-)]chromate(1-), compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84195-82-4	Contains (regardless of intentional or impurities)	chemical products
17015	Chromate(1-), [2,4-dihydro-4-[[2-(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](2,4-dihydro-4-[[2-(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84195-83-5	Contains (regardless of intentional or impurities)	chemical products
17016	Trihydrogen bis[3-[[1-(anilino)carbonyl]-2-oxopropyl]azo]-2-hydroxy-5-nitrobenzene-1-sulphonato(3-)]chromate(3-), compound with 3-[[2-ethylhexyl]oxy]propylamine (1:3)	84195-84-6	Contains (regardless of intentional or impurities)	chemical products
17017	Tetrasodium [mu-[[7-[[4-[[6-anilino-1-hydroxy-3-sulpho-2-naphthyl]azo]-3,3'-dihydroxy(1,1'-biphenyl)-4-yl]azo]-8-hydroxynaphthalene-1,3,5-trisulphonato(8-)]dicuprate(4-)	84195-85-7	Intentional addition / 1,000ppm	chemical products
17018	Trihydrogen bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzene-1-sulphonato(3-)]chromate(3-), compound with 2,2'-(dodecylimino)bis[ethanol] (1:3)	84195-87-9	Contains (regardless of intentional or impurities)	chemical products
17019	Hydrogen bis[1-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphtholato(2-)]chromate(1-), compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84195-88-0	Contains (regardless of intentional or impurities)	chemical products
17020	Chromate(1-), [1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)](2,4-dihydro-4-[[2-(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84195-89-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17021	Hydrogen bis[2,4-dihydro-4-[[2-(hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-), compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84195-90-4	Contains (regardless of intentional or impurities)	chemical products
17022	Hydrogen bis[2,4-dihydro-4-[[2-(hydroxy-5-methyl-3-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-), compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84195-91-5	Contains (regardless of intentional or impurities)	chemical products
17023	Chromate(1-), [1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphthalenolato(2-)](2,4-dihydro-4-[[2-(hydroxy-5-nitrophenyl)azo]-5-methyl-1-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84195-92-6	Contains (regardless of intentional or impurities)	chemical products
17024	Manganese(2+) tert-decanoate	84195-96-0	Contains (regardless of intentional or impurities)	chemical products
17025	Copper(2+) tert-decanoate	84195-98-2	Intentional addition / 1,000ppm	chemical products
17026	Cobalt(2+) tert-decanoate	84195-99-3	Intentional addition / 1,000ppm	chemical products
17027	2-Chloro-5-(4-chlorophenoxy)-4-diethylaminobenzenediazonium tetrafluoroborate	84196-02-1	Intentional addition / 1%	chemical products
17028	2-Chloro-5-(4-chlorophenoxy)-4-dimethylaminobenzenediazonium tetrafluoroborate	84196-04-3	Intentional addition / 1%	chemical products
17029	Cuprate(7-), [2-[[1-[4-[2-[4-[[4-[2-[4-[4-[[2-(2-carboxyphenyl)azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-2-sulfonylphenyl]ethenyl]-3-sulfonylphenyl]amino]-6-(phenylamino)-1,3,5-triazin-2-yl]amino]-2-sulfonylphenyl]ethenyl]-3-sulfonylphenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(9-)]-, pentasodium dihydrogen	84196-27-0	Intentional addition / 1,000ppm	chemical products
17030	Cuprate(5-), [mu-2-[[1-[4-[2-[4-[[4-[2-[4-[4-[[2-(2-carboxyphenyl)azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-2-sulfonylphenyl]ethenyl]-3-sulfonylphenyl]amino]-6-(phenylamino)-1,3,5-triazin-2-yl]amino]-2-sulfonylphenyl]ethenyl]-3-sulfonylphenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(9-)]]di-, pentasodium	84196-28-1	Intentional addition / 1,000ppm	chemical products
17031	Trisodium bis[9-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzene-1-sulphonato(3-)]chromate(3-)	84204-63-7	Contains (regardless of intentional or impurities)	chemical products
17032	Trisodium bis[9-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulphonato(3-)]cobaltate(3-)	84204-70-6	Intentional addition / 1,000ppm	chemical products
17033	Hydrogen bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-), compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84215-37-2	Contains (regardless of intentional or impurities)	chemical products
17034	Chromate(1-), [2,4-dihydro-4-[[2-(hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-, hydrogen, compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84215-38-3	Contains (regardless of intentional or impurities)	chemical products
17035	Trihydrogen bis[3-hydroxy-4-[[2-(hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]chromate(3-), compound with 2,2'-(dodecylimino)bis[ethanol] (1:3)	84215-39-4	Contains (regardless of intentional or impurities)	chemical products
17036	Hydrogen bis[2,4-dihydro-4-[[2-(hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-), compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84215-40-7	Contains (regardless of intentional or impurities)	chemical products
17037	Chromate(1-), [2,4-dihydro-4-[[2-(hydroxy-5-methyl-3-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](2-[[4-[[5-[[2,2-dimethylpropyl]-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, hydrogen, compound with 2,2'-(dodecylimino)bis[ethanol] (1:1)	84215-41-8	Contains (regardless of intentional or impurities)	chemical products
17038	Cobalt bis(2,5,5-trimethylhexanoate)	84215-43-0	Intentional addition / 1%	chemical products
17039	Trihydro-4-phenylmorpholine-N4boron	84215-46-3	Intentional addition / 1%	chemical products
17040	Disodium 3,6-bis[[2-[[dihydroxyarsino]oxy]phenyl]azo]-4,5-dihydroxynaphthalene-2,7-disulphonate	84215-47-4	Contains (regardless of intentional or impurities)	chemical products
17041	Disodium 3-[[2-[[dihydroxyarsino]oxy]phenyl]azo]-4,5-dihydroxynaphthalene-2,7-disulphonate	84215-48-5	Contains (regardless of intentional or impurities)	chemical products
17042	Cuprate(7-), dro-3-methyl-5-oxo-1H-pyrazol-1-yl]-2-sulfonylphenyl]ethenyl]-3-sulfonylphenyl]amino)-6-(phenylamino)-1,3,5-triazin-2-yl]amino]-2-sulfonylphenyl]ethenyl]-3-sulfonylphenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(9-)]-, pentasodium dihydrogen	84215-63-4	Intentional addition / 1,000ppm	chemical products
17043	Amines, N-tallow alkyltrimethylmedi-, compounds with boric acid (H3BO3)	84238-10-8	Intentional addition / 1%	chemical products
17044	Antimony, citric acid complexes, potassium	84238-43-7	Contains (regardless of intentional or impurities)	chemical products
17045	Benzenesulfonic acid, 4-dodecyl-, cerium(4+) salt, basic	84238-45-9	Intentional addition / 1%	chemical products
17046	Copper, isodecanoate naphthenate complexes	84238-48-2	Intentional addition / 1,000ppm	chemical products
17047	Copper, isononanoate naphthenate complexes	84238-49-3	Intentional addition / 1,000ppm	chemical products
17048	Copper, isooctanoate naphthenate complexes	84238-50-6	Intentional addition / 1,000ppm	chemical products
17049	Copper, naphthenate neodecanoate complexes	84238-51-7	Intentional addition / 1,000ppm	chemical products
17050	N-[6-8-dihydro-9-[[2-(hydroxy-1-(hydroxymethyl)ethoxy)methyl]-6-oxo-1H-purin-2-yl]acetamide	84245-12-5	Contains (regardless of intentional or impurities)	chemical products
17051	3-Hexene, 1-bromo-	84254-20-6	Intentional addition / 1,000ppm	chemical products
17052	1-Ethyl-4-[[3-ethyl-3H-benzoselenazol-2-ylidene]methyl]quinolinium iodide	84255-09-4	Contains (regardless of intentional or impurities)	chemical products
17053	Benzenamine, 4,4'-carbonimidoylbis[N,N-dimethyl-, mononitrate	84255-15-2	Contains (regardless of intentional or impurities)	chemical products
17054	4,4'-Carbonimidoylbis[N,N-dimethylanilinium] sulphate	84255-16-3	Contains (regardless of intentional or impurities)	chemical products
17055	(2-Acetylthio)ethyltrimethylammonium perchlorate	84255-37-8	Intentional addition / 1,000ppm	chemical products
17056	Cobalt(II) isooctanoate	84255-51-6	Intentional addition / 1%	chemical products
17057	Cobalt(2+) isononanoate	84255-52-7	Intentional addition / 1%	chemical products
17058	Cobalt(II) isodecanoate	84255-53-8	Intentional addition / 1%	chemical products
17059	Cobalt, 2-hydroxy-1,2,3-propanetricarboxylate ammonium complexes	84281-83-4	Intentional addition / 1%	chemical products
17060	Ethanedioic acid, ion(1-), salt with oxidized benzaldehyde-N,N-diethylbenzenamine-N,N-dimethylbenzenamine reaction products (1:1)	84281-84-5	Intentional addition / 1,000ppm	chemical products
17061	(Isononanoato-O)(isooctanoato-O)cobalt	84282-04-2	Intentional addition / 1%	chemical products
17062	(Isodecanoato-O)(isooctanoato-O)cobalt	84282-05-3	Intentional addition / 1%	chemical products
17063	(Isodecanoato-O)(isononanoato-O)cobalt	84282-06-4	Intentional addition / 1%	chemical products
17064	(Isodecanoato-O)(neodecanoato-O)cobalt	84282-07-5	Intentional addition / 1%	chemical products
17065	Trisodium bis[2-[4-[[1-[[2,5-dichloroanilino]carbonyl]-2-oxopropyl]azo]-3-hydroxybenzoyl]benzoato(3-)]cobaltate(3-)	84282-28-0	Intentional addition / 1%	chemical products
17066	Disodium [mu-[[2,2'-[carbonylbis[imino(1-hydroxy-3-sulphonaphthalene-2,6-diyl)azo]]bis[benzoato]](6-)]]dicuprate(2-)	84282-29-1	Intentional addition / 1,000ppm	chemical products
17067	Dipotassium hydrogen tetrafluoro[mu-oxothorato(3-)-O-O]]-, mu-oxodiborate(3-)	84282-32-6	Intentional addition / 1%	chemical products
17068	Tripotassium hexafluoro[tri-mu-oxotriborate(3-)]	84282-33-7	Intentional addition / 1%	chemical products
17069	2,6-Dimethyl-4-(1-naphthyl)pyrrolium hexafluoroarsenate	84282-36-0	Contains (regardless of intentional or impurities)	chemical products
17070	3,3',4,4',5-Pentabromobiphenyl	84303-46-8	Intentional addition / 1,000ppm	chemical products
17071	2,2',3,4,5,5',6-Heptabromobiphenyl	84303-49-1	Intentional addition / 1,000ppm	chemical products
17072	Trisodium bis[2-[4-[[1-[[2-chloroanilino]carbonyl]-2-oxopropyl]azo]-3-hydroxybenzoyl]benzoato(3-)]cobaltate(3-)	84304-11-0	Intentional addition / 1%	chemical products
17073	Trisodium bis[2-[4-[[8-(benzoylamino)-2-hydroxy-1-naphthyl]azo]-3-hydroxybenzoyl]benzoato(3-)]cobaltate(3-)	84304-12-1	Intentional addition / 1%	chemical products
17074	2,6-Dimethyl-4-phenylpyrrolium hexafluoroarsenate	84304-15-4	Contains (regardless of intentional or impurities)	chemical products
17075	4-Cyclohexyl-2,6-dimethylpyrrolium hexafluoroarsenate	84304-16-5	Contains (regardless of intentional or impurities)	chemical products
17076	Cyclohexane, 1,1'-(1,3-trimethyl-1,3-propanediyl)bis[4-methyl-]	84304-67-0	Intentional addition / 1%	chemical products
17077	Benzoic acid, 2-amino-, barium salt (2:1), monohydrate	84315-79-1	Intentional addition / 1,000ppm	chemical products
17078	Phosphoric acid, anhydride with boric acid (1:3), zinc salt (1:3)	84332-91-2	Intentional addition / 1%	chemical products
17079	Tridodecyl 2,2',2''-[octylstannylidene]tris(thio)triacetate	84332-95-6	Contains (regardless of intentional or impurities)	chemical products
17080	2-Ethylhexyl 4-[[dibutyl(dodecylthio)stannyl]oxy]-4-oxoisocrotonate	84332-96-7	Contains (regardless of intentional or impurities)	chemical products
17081	3,5,5'-Trimethylhexyl 6,6'-dibutyl-15,17-trimethyl-4,8,11-trioxo-5,12-trioxo-6-stannaoctadeca-2,9-dienoate	84332-97-8	Contains (regardless of intentional or impurities)	chemical products
17082	2-Ethylhexyl 4,4-bis(3-butoxy-3-oxopropyl)-10-ethyl-7-oxo-8-oxa-3,5-dithia-4-stannatetradecanoate	84332-98-9	Contains (regardless of intentional or impurities)	chemical products
17083	(Isooctanoato-O)(neodecanoato-O)cobalt	84367-83-9	Intentional addition / 1%	chemical products
17084	(Isononanoato-O)(neodecanoato-O)cobalt	84367-84-0	Intentional addition / 1%	chemical products
17085	2-Ethylhexyl 10-ethyl-4,4-bis(3-octadecyloxy)-3-oxopropyl]-7-oxo-8-oxa-3,5-dithia-4-stannatetradecanoate	84370-78-5	Contains (regardless of intentional or impurities)	chemical products
17086	Barium tert-decanoate	84370-80-9	Contains (regardless of intentional or impurities)	chemical products
17087	Cobalt, isodecanoate naphthenate complexes	84418-53-1	Intentional addition / 1%	chemical products
17088	Cobalt, isononanoate naphthenate complexes	84418-54-2	Intentional addition / 1%	chemical products
17089	Cobalt, isooctanoate naphthenate complexes	84418-55-3	Intentional addition / 1%	chemical products
17090	Cobalt, naphthenate neodecanoate complexes	84418-56-4	Intentional addition / 1%	chemical products
17091	Molybdate(3-), tetracosao- mu-oxododecaoxo[mu.12-phosphato(3-)-O:O:O:O:O:O:O:O:O:O:O:O:O:O:O:O:O:O:O:O:O:O]dodeca-, salt with oxidized benzaldehyde-N,N-diethylbenzenamine-N,N-dimethylbenzenamine reaction product	84418-66-6	Intentional addition / 1,000ppm	chemical products
17092	Disodium [1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalolato(2-)](4-hydroxy-3-[[2-(hydroxy-5-nitrophenyl)azo]-7-(1-oxoalkyl)amino]naphthalene-2-sulphonato(3-)]chromate(2-)	84434-74-2	Contains (regardless of intentional or impurities)	chemical products
17093	Octaboron trizinc pentadecaoxide	84455-32-3	Intentional addition / 1%	chemical products
17094	Chromium, hydroxy-2-hydroxy-3,5-bis(1-methylethyl)benzoate complexes	84501-45-1	Intentional addition / 1,000ppm	chemical products
17095	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[2-(4-chloro-6-[[3-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino)ethyl]amino]sulfonyl sulfo derivatives, tetrasodium salts	84501-46-2	Intentional addition / 1,000ppm	chemical products
17096	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[[[[[2-methoxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]carbonyl]amino]methyl]amino]sulfonyl sulfo [[2-(sulfoxy)ethyl]amino]sulfonyl derivatives, tetrasodium salts	84501-47-3	Intentional addition / 1,000ppm	chemical products
17097	2-(4-Chlorophenoxy)-4-(dimethylamino)benzenediazonium tetrafluoroborate	84522-10-1	Intentional addition / 1%	chemical products
17098	Iron tris(phenylacetate)	84522-39-4	Intentional addition / 1%	chemical products
17099	[1R-(1.alpha.,2.beta.,3.alpha.,5.alpha.)]-[2-(1,3-Dithian-2-ylmethyl)-6,6-dimethylbicyclo[3.1.1]hept-3-yl-c.5]dihydroboron	84525-73-5	Intentional addition / 1%	chemical products
17100	Tetraalithium 6,6'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[4-amino-5-hydroxynaphthalene-1,3-disulphonate]	84559-91-1	Intentional addition	chemical products
17101	Barium 3(or 6)-carboxylato-4-hexylcyclohex-2-ene-1-octanoate	84581-19-1	Contains (regardless of intentional or impurities)	chemical products
17102	Benzothiazolium, 2-[4-(dimethylamino)phenyl]-3,6-dimethyl-, chloro cyano N-[9-[[4-(diethylamino)phenyl]phenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-ethylthetaniumium sulfate cuprate ferrate complexes	84583-67-5	Intentional addition / 1,000ppm	chemical products
17103	Ethanaminium, N-[4-[[4-(diethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-ethyl-, chloro cyano cuprate ferrate complexes	84583-71-1	Intentional addition / 1,000ppm	chemical products
17104	Ethanaminium, N-[4-[[4-(diethylamino)phenyl]phenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-ethyl-, cyano sulfate cuprate ferrate complexes	84583-72-2	Intentional addition / 1,000ppm	chemical products
17105	Methanaminium, N-[4-[[4-(diethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-methyl-, chloro cyano cuprate ferrate complexes	84583-77-7	Intentional addition / 1,000ppm	chemical products
17106	Methanaminium, N-[4-[[4-(diethylamino)phenyl][4-(phenylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-methyl-, chloro cyano cuprate ferrate complexes	84583-78-8	Intentional addition / 1,000ppm	chemical products
17107	Xanthylum, 9-[2-(2-carboxyphenyl)-3,6-bis(diethylamino)-, chloro cyano cuprate ferrate complexes	84583-84-6	Intentional addition / 1,000ppm	chemical products
17108	Xanthylum, 9-[2-(ethoxycarbonyl)phenyl]-3,6-bis(ethylamino)-2,7-dimethyl-, 9-[2-(2-carboxyphenyl)-3,6-bis(diethylamino)xanthylum chloro cyano cuprate ferrate complexes	84583-85-7	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17109	Zirconium, carbonate fluoro ammonium complexes	84583-86-8	Contains (regardless of intentional or impurities)	chemical products
17110	Zirconium, D-gluconate sodium complexes	84583-87-9	Contains (regardless of intentional or impurities)	chemical products
17111	Zirconium, oxalate lithium complexes	84583-88-0	Contains (regardless of intentional or impurities)	chemical products
17112	Zirconium, oxalate potassium complexes	84583-89-1	Contains (regardless of intentional or impurities)	chemical products
17113	Sulfuric acid, zirconium salt, basic	84583-91-5	Contains (regardless of intentional or impurities)	chemical products
17114	3-Chloro-4-hexahydro-1H-azepin-1-yl-benzenediazonium tetrafluoroborate	84604-31-9	Intentional addition / 1%	chemical products
17115	1,3-Diethyl-2-fluorobenzene	84604-67-1	Intentional addition / 1,000ppm	chemical products
17116	Barium [1,1-biphenyl]-2-olate	84604-76-2	Contains (regardless of intentional or impurities)	chemical products
17117	Bis[di(3,5,5-trimethylhexyl)ditiocarbamate-S,S]nickel	84604-85-5	Contains (regardless of intentional or impurities)	chemical products
17118	Barium, carbonate C12-18-unsaturated alcohols tall-oil fatty acid complexes	84605-21-0	Intentional addition / 1,000ppm	chemical products
17119	Phosphorodithioic acid, mixed O,O-bis[1,3-dimethylbutyl and isopropyl] esters, zinc salts	84605-29-8	Intentional addition / 1,000ppm	chemical products
17120	Lauric acid, monoanhydride with phosphoric acid, barium salt	84605-32-5	Contains (regardless of intentional or impurities)	chemical products
17121	Distillates (coal tar), benzole fraction	84650-02-2	Contains (regardless of intentional or impurities)	chemical products
17122	Distillates (coal tar), light oils	84650-03-3	Contains (regardless of intentional or impurities)	chemical products
17123	Distillates (coal tar), naphthalene oils	84650-04-4	Contains (regardless of intentional or impurities)	chemical products
17124	Barium isonanoate	84681-75-4	Contains (regardless of intentional or impurities)	chemical products
17125	Barium 4,5-dihydro-5-oxo-1-(4-sulphonatophenyl)-4-[(4-sulphonatophenyl)azo]-1H-pyrazole-3-carboxylate (3:2)	84681-80-1	Contains (regardless of intentional or impurities)	chemical products
17126	Barium 2,5-dichloro-4-[4,5-dihydro-3-methyl-5-oxo-4-[(4-sulphonatophenyl)azo]-1H-pyrazol-1-yl]benzenesulfonate	84681-81-2	Contains (regardless of intentional or impurities)	chemical products
17127	Tribarium bis[tris[5,6-dihydro-5-(hydroxyimino)-6-oxonaphthalene-2-sulphonato(2-)-O5,O6]ferrate(3-)]	84682-41-7	Contains (regardless of intentional or impurities)	chemical products
17128	Chromate(2-), [4-[[5-chloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-3H-pyrazol-3-onato(2-)]-[2-[[4,5-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]]-, disodium	84682-43-9	Contains (regardless of intentional or impurities)	chemical products
17129	Disodium [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]-[2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulphophenyl)-1H-pyrazol-4-yl]azo]benzoato(3-)]chromate(2-)	84682-44-0	Contains (regardless of intentional or impurities)	chemical products
17130	Chromate(2-), [4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, disodium	84682-45-1	Contains (regardless of intentional or impurities)	chemical products
17131	Disodium [4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-[1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalato(2-)]chromate(2-)	84682-46-2	Contains (regardless of intentional or impurities)	chemical products
17132	Tricopper(1+) hydrogen hexakis(cyano-c)ferrate(4-), compound with 4-[[p-(diethylamino)phenyl][4-(ethylimino)-(4H)-naphthylidene]methyl]-N,N-diethylaniline (1:1)	84682-48-4	Intentional addition / 1,000ppm	chemical products
17133	Nitric acid, nickel(2+) praseodymium(3+) salt (12:3:2)	84682-59-7	Intentional addition / 1,000ppm	chemical products
17134	Margosa, extract	84696-25-3	Intentional addition	chemical products
17135	Tin, melting residues	84696-55-9	Intentional addition / 1,000ppm	chemical products
17136	Cadmium isonanoate	84696-56-0	Contains (regardless of intentional or impurities)	chemical products
17137	Barium 4-[[4-ethoxy-2-sulphonatophenyl]azo]-3-hydroxy-2-naphthoate	84696-57-1	Contains (regardless of intentional or impurities)	chemical products
17138	Benzenamine, 4,4'-carbonimidoylbis[N,N-dimethyl]-, compound with molybdenum hydroxide oxide phosphate	84696-61-7	Contains (regardless of intentional or impurities)	chemical products
17139	1,3-Benzenediamine, 4-(phenylazo)-, compound with molybdenum hydroxide oxide phosphate	84696-62-8	Intentional addition / 1,000ppm	chemical products
17140	Manganese, 4-[[4-ethoxy-2-sulphophenyl]azo]-3-hydroxy-2-naphthalenecarboxylate complexes	84712-57-2	Contains (regardless of intentional or impurities)	chemical products
17141	2-[1,1-Dimethyl-3-[[tributylstannyloxy]butoxy]-4,6,6-trimethyl-1,3,2-dioxaborinane	84712-69-6	Contains (regardless of intentional or impurities)	chemical products
17142	Methyl (2,Z,2)-8-dodecyl-8-[[4-methoxy-1,4-dioxobut-2-enyloxy]-3,6,10-trioxo-2,7,9-trioxo-8-stannatrideca-4,11-dien-13-olate	84712-70-9	Contains (regardless of intentional or impurities)	chemical products
17143	Ammonium copper(2+) 2-hydroxypropane-1,2,3-tricarboxylate	84713-02-0	Intentional addition / 1,000ppm	chemical products
17144	Sodium bis[1-(2-hydroxy-5-methyl-3-nitrophenyl)azo]naphthalen-2-olato(2-)]cobaltate(1-)	84713-03-1	Intentional addition / 1%	chemical products
17145	1,2,3,4(or 1,2,4,5)-Tetrachlorobenzene	84713-12-2	Intentional addition / 1,000ppm	chemical products
17146	Barium glycerol phosphate	84713-18-8	Contains (regardless of intentional or impurities)	chemical products
17147	Sodium [3S-(3.alpha.,4.beta.21.beta.)]-[14-ethyl-21-(methoxycarbonyl)-4,8,13,18-tetramethyl-20-oxo-9-vinylphorbine-3-propanoate(3-)-N23,N24,N25,N26]cuprate(1-)	84773-84-2	Intentional addition / 1,000ppm	chemical products
17148	Potassium [3S-(3.alpha.,4.beta.21.beta.)]-[14-ethyl-21-(methoxycarbonyl)-4,8,13,18-tetramethyl-20-oxo-9-vinylphorbine-3-propanoate(3-)-N23,N24,N25,N26]cuprate(1-)	84773-85-3	Intentional addition / 1,000ppm	chemical products
17149	Sodium [3S-(3.alpha.,4.beta.21.beta.)]-[14-ethyl-13-formyl-21-(methoxycarbonyl)-4,8,18-trimethyl-20-oxo-9-vinylphorbine-3-propanoate(3-)-N23,N24,N25,N26]cuprate(1-)	84773-86-4	Intentional addition / 1,000ppm	chemical products
17150	Cuprate(1-), (9-ethenyl-14-ethyl-13-formyl-21-(methoxycarbonyl)-4,8,18-trimethyl-20-oxo-3-phorbinepropanoate(3-)-N23,N24,N25,N26)-, potassium, (SP-4-2-(3S-(3.alpha.,4.beta.21.beta.)))-	84773-87-5	Intentional addition / 1,000ppm	chemical products
17151	Matte, tin	84775-68-8	Intentional addition / 1,000ppm	chemical products
17152	Slimes and sludges, tin electrolytic	84776-00-1	Contains (regardless of intentional or impurities)	chemical products
17153	Speiss, tin	84776-01-2	Contains (regardless of intentional or impurities)	chemical products
17154	Tin ores, melting residues, hardhead	84776-04-5	Intentional addition / 1,000ppm	chemical products
17155	Alkanes, C16-27, chloro	84776-07-8	Intentional addition / 1,000ppm	chemical products
17156	Fatty acids, C8-18 and C18-unsaturated, nickel salts	84776-45-4	Contains (regardless of intentional or impurities)	chemical products
17157	Fatty acids, C8-18 and C18-unsaturated, zirconium salts	84776-50-1	Contains (regardless of intentional or impurities)	chemical products
17158	Aluminum oxide (Al2O3), manufacturing residues, red mud, vanadium-containing extracts - Vanadium-containing salt mixtures obtained as a by-product from the process for obtaining aluminum hydroxide from bauxite under alkaline condition.	84777-02-6	Intentional addition / 1%	chemical products
17159	Antimony, N-[4-[[4-(diethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylene]-2,5-cyclohexadien-1-ylidene]-N-ethylethanaminium tannin complexes	84777-04-8	Contains (regardless of intentional or impurities)	chemical products
17160	Boric acid (H3BO3), reaction products with 1,2-ethanedithiolbis[oxyl]bis[methano], ethylene glycol, formaldehyde and glutaraldehyde	84777-09-3	Intentional addition / 1%	chemical products
17161	Chromate(1-), [6-amino-5-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthalenesulfonato(2-)]-[2-[[2-hydroxyethyl]imino]methyl]phenolato(2-)]-, sodium	84777-12-8	Contains (regardless of intentional or impurities)	chemical products
17162	Chromate(1-), bis[6-amino-5-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthalenesulfonato(2-)]-, sodium	84777-13-9	Contains (regardless of intentional or impurities)	chemical products
17163	Chromate(3-), bis[5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(3-)]-, ethanalamine sodium salts	84777-14-0	Contains (regardless of intentional or impurities)	chemical products
17164	Chromate(5-), bis[5-chloro-2-hydroxy-3-[[[2-hydroxy-5-[[4-sulphophenyl]azo]phenyl]methylene]amino]benzenesulfonato(4-)]-, potassium sodium	84777-15-1	Contains (regardless of intentional or impurities)	chemical products
17165	Chromate(1-), bis[2,5-dichloro-4-[[4-hydroxy-3-[[[2-(phenylamino)ethyl]imino]methyl]phenyl]azo]benzenesulfonato(2-)]-, sodium	84777-16-2	Contains (regardless of intentional or impurities)	chemical products
17166	Chromate(3-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]-, ethanalamine sodium salts	84777-17-3	Contains (regardless of intentional or impurities)	chemical products
17167	Chromate(5-), bis[4-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulphophenyl)-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(4-)]-, sodium	84777-18-4	Contains (regardless of intentional or impurities)	chemical products
17168	Chromate(5-), bis[3-[[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulphophenyl)-1H-pyrazol-4-yl]methylene]amino]-2-hydroxy-5-nitrobenzenesulfonato(4-)]-, sodium	84777-19-5	Contains (regardless of intentional or impurities)	chemical products
17169	Chromate(5-), bis[3-hydroxy-4-[[1-hydroxy-8-sulfo-2-naphthalenyl]azo]-1-naphthalenesulfonato(4-)]-, sodium	84777-20-8	Contains (regardless of intentional or impurities)	chemical products
17170	Chromate(4-), [5-chloro-2-hydroxy-3-[[[2-hydroxy-5-[[4-sulphophenyl]azo]phenyl]methylene]amino]benzenesulfonato(4-)]-[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, potassium sodium	84777-21-9	Contains (regardless of intentional or impurities)	chemical products
17171	Chromate(4-), [5-chloro-2-hydroxy-3-[[[2-hydroxy-5-[[4-sulphophenyl]azo]phenyl]methylene]amino]benzenesulfonato(4-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonato(3-)]-, sodium	84777-22-0	Contains (regardless of intentional or impurities)	chemical products
17172	Chromate(2-), [4-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulphophenyl)-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(4-)]-[2-[[4-(morpholinyl)ethyl]imino]methyl]phenolato]-, sodium	84777-23-1	Contains (regardless of intentional or impurities)	chemical products
17173	Cobaltate(3-), bis[5-chloro-2-hydroxy-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, diethanalamine sodium salts	84777-24-2	Intentional addition / 1%	chemical products
17174	Cobaltate(3-), bis[5-chloro-2-hydroxy-3-[[2-oxo-1-[[phenylmethyl]amino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, sodium	84777-25-3	Intentional addition / 1%	chemical products
17175	Cuprate(2-), [3-[[2,4-dihydroxy-3-[[4-nitro-2-sulphophenyl]azo]phenyl]azo]-2-hydroxy-5-nitrobenzenesulfonato(4-)]-, sodium	84777-26-4	Intentional addition / 1,000ppm	chemical products
17176	Ferrate(4-), hexakis(cyano-c)-, 4-[[4-amino]phenyl](4-imino-2,5-cyclohexadien-1-ylidene)methyl]-2-methylbenzenamine copper(2+) sodium salts	84777-31-1	Intentional addition / 1,000ppm	chemical products
17177	Benzothiazolium, 2-[[4-(dimethylamino)phenyl]-3,6-dimethyl-, chloro cyano cuprate ferrate complexes	84777-34-4	Intentional addition / 1,000ppm	chemical products
17178	Stannane, tributyl-, mono-(tall-oil fatty acloxy) derivatives	84777-54-8	Contains (regardless of intentional or impurities)	chemical products
17179	Chromium isooctanoate	84777-60-6	Intentional addition / 1,000ppm	chemical products
17180	Bis(cyclohexylammonium) bis[4-[[2-hydroxy-4-nitrophenyl]azo]benzene-1,3-diolato(2-)]ferrate(2-)	84777-66-2	Intentional addition / 1%	chemical products
17181	Trisodium bis[2-[[4-[[3-(benzoylamino)-2-hydroxy-1-naphthyl]azo]-3-hydroxybenzoyl]benzoato(3-)]-]cobaltate(3-)	84777-67-3	Intentional addition / 1%	chemical products
17182	Cobaltate(3-), [2-[[4-[[3-(benzoylamino)-2-hydroxy-1-naphthalenyl]azo]-3-hydroxybenzoyl]benzoato(3-)]-[2-[[4-[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxybenzoyl]benzoato(3-)]]-, trisodium	84777-68-4	Intentional addition / 1%	chemical products
17183	Cobaltate(3-), [2-[[4-[[8-(benzoylamino)-2-hydroxy-1-naphthalenyl]azo]-3-hydroxybenzoyl]benzoato(3-)]-[2-[[4-[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxybenzoyl]benzoato(3-)]]-, trisodium	84777-69-5	Intentional addition / 1%	chemical products
17184	Trisodium bis[2-[[4-[[3-benzamido-2-hydroxy-1-naphthyl]azo]-3-hydroxybenzoyl]benzoato(3-)]]chromate(3-)	84777-70-8	Contains (regardless of intentional or impurities)	chemical products
17185	Trisodium bis[2-[[4-[[2-hydroxy-1-naphthyl]azo]benzoyl]benzoato(3-)]]cobaltate(3-)	84777-71-9	Intentional addition / 1%	chemical products
17186	Trisodium bis[2-[[4-[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxybenzoyl]benzoato(3-)]]chromate(3-)	84777-72-0	Contains (regardless of intentional or impurities)	chemical products
17187	Trisodium bis[2-[[4-[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxybenzoyl]benzoato(3-)]]cobaltate(3-)	84777-73-1	Intentional addition / 1%	chemical products
17188	[Phthalylbis(oxyl)]bis[diethyl]octyloxystannane	84787-73-5	Contains (regardless of intentional or impurities)	chemical products
17189	1,1,3,3-Tetrabutyl-1,3-bis(tetrahydroxy)dioxane	84787-74-6	Contains (regardless of intentional or impurities)	chemical products
17190	Hexadecyl 6,6-dibutyl-4,8,11-trioxo-5,12-trioxo-6-stannooctacos-2,9-dienoate	84787-79-1	Contains (regardless of intentional or impurities)	chemical products
17191	8,8,14,14,20,20-hexabutyl-5,23-diethyl-10,18-dioxo-7,9,19,21-tetraoxa-13,15-dithia-8,14,20-tristannaheptacosane	84787-80-4	Contains (regardless of intentional or impurities)	chemical products
17192	4-Bis(phenylmethyl)amino-3-ethoxybenzenediazonium tetrafluoroborate	84788-07-8	Intentional addition / 1%	chemical products
17193	Cobaltate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamido(2-)]-[N-[7-hydroxy-8-[[2-hydroxy-5-[[methylamino]sulfonyl]phenyl]azo]-1-naphthalenyl]acetamidato(2-)]-, sodium	84788-14-7	Intentional addition / 1%	chemical products
17194	Isotridecyl 3-[[diethylchlorostanny]thio]propionate	84788-16-9	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17195	Diisotridecyl 4,4'-[[dibutylstannylenebis(oxo)]bis[4-oxobut-2-enoate]	84788-17-0	Contains (regardless of intentional or impurities)	chemical products
17196	Isotridecyl 3'-[[dibutyl(1-oxoisooctadecyl)oxy]stannyl]thio]propionate	84803-43-0	Contains (regardless of intentional or impurities)	chemical products
17197	Sodium bis[4-(4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl)benzenesulphonamidato(2-)]cobaltate(1-)	84812-60-2	Intentional addition / 1%	chemical products
17198	Chromate(1-), bis[4-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonamidato(2-)]-, sodium	84812-61-3	Contains (regardless of intentional or impurities)	chemical products
17199	Sodium bis[1-[3-[[5-chloro-2-hydroxy-4-methoxyphenyl]azo]-4-hydroxyphenyl]pyrrolidin-2-onato(2-)]cobaltate(1-)	84812-62-4	Intentional addition / 1%	chemical products
17200	Chromate(3-), bis[4-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, hydrogen	84812-63-5	Contains (regardless of intentional or impurities)	chemical products
17201	1,1,1,2-Tetrachloro-3-fluoropropane	84816-05-7	Intentional addition	chemical products
17202	1,3,2-Dioxaborolane, 2-hydroxy-4-tetradecyl-	84819-41-0	Intentional addition / 1%	chemical products
17203	Cuprate(3-), [29H,31H-phthalocyanine-C,C,O-trisulfonato(5-)-N29,N30,N31,N32]-, trihydrogen, compound with 2,2,2'-nitrotris[ethanol] (1:3)	84823-11-0	Intentional addition / 1,000ppm	chemical products
17204	Carboxylic acids, C5-9, copper salts	84836-95-3	Intentional addition / 1,000ppm	chemical products
17205	Tributyl(2,3-dibromo-2-methylpropionyl)oxy]stannane	84837-25-2	Contains (regardless of intentional or impurities)	chemical products
17206	(Isocetanoato-O)(neodecanoato-O)nickel	84852-35-7	Contains (regardless of intentional or impurities)	chemical products
17207	(Isodecanoato-O)(isononanoato-O)nickel	84852-36-8	Contains (regardless of intentional or impurities)	chemical products
17208	Isononanoic acid, nickel(2+) salt	84852-37-9	Contains (regardless of intentional or impurities)	chemical products
17209	(2-Ethylhexanoato-O)(isocetanoato-O)nickel	84852-38-0	Contains (regardless of intentional or impurities)	chemical products
17210	(2-Ethylhexanoato-O)(isodecanoato-O)nickel	84852-39-1	Contains (regardless of intentional or impurities)	chemical products
17211	1,1'-[Ethane-1,2-diyl]bis[pentabromobenzene]	84852-53-9	Contains (regardless of intentional or impurities)	chemical products
17212	2-[[Butylthioxostannyl]thio]ethanol	84864-54-0	Contains (regardless of intentional or impurities)	chemical products
17213	1,3-Benzenedicarbonitrile, 2-[[4-(diethylamino)-2-methylphenyl]azo]-5-nitro-	84870-85-5	Contains (regardless of intentional or impurities)	chemical products
17214	Hydrogen bis[1-[[2-hydroxy-5-nitrophenyl]azo]naphthalen-2-olato(2-)]chromate(1-), compound with 2,2,2'-nitrotris[ethanol] (1:1)	84878-20-6	Contains (regardless of intentional or impurities)	chemical products
17215	9-(2-Carboxyphenyl)-3,6-bis(diethylamino)xanthylium bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	84878-21-7	Contains (regardless of intentional or impurities)	chemical products
17216	Ferrate(1-), [3-[[2,4-dihydroxy-5-[[4-nitro-2-sulfophenyl]azo]phenyl]azo]-2-hydroxy-5-nitrobenzenesulfonato(4-)]-, sodium	84878-22-8	Intentional addition / 1%	chemical products
17217	Barium isooctadecanoate	84878-35-3	Contains (regardless of intentional or impurities)	chemical products
17218	Cadmium isooctadecanoate	84878-36-4	Contains (regardless of intentional or impurities)	chemical products
17219	Cadmium tert-decanoate	84878-37-5	Contains (regardless of intentional or impurities)	chemical products
17220	Cadmium bis(nonylphenolate)	84878-48-8	Contains (regardless of intentional or impurities)	chemical products
17221	Cadmium bis(octylphenolate)	84878-51-3	Contains (regardless of intentional or impurities)	chemical products
17222	5,23-Diethyl-8,8,14,14,20,20-hexaacyl-10,18-dioxo-7,9,19,21-tetraoxa-13,15-dithia-8,14,20-trisnanaheptacosane	84896-41-8	Contains (regardless of intentional or impurities)	chemical products
17223	Propanoic acid, 3,3'-[[dibutylstannylenebis(thio)]bis-, diisotridecyl ester	84896-44-6	Contains (regardless of intentional or impurities)	chemical products
17224	Chromate(1-), [N-8-[[5-[[ethylamino)sulfonyl]-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]acetamidato(2-)]methyl 8-[[5-[[ethylamino)sulfonyl]-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]carbamato(2-)]-, sodium	84896-45-7	Contains (regardless of intentional or impurities)	chemical products
17225	5H-Pyrrolo[3,2-d]pyrimidine, 4-chloro-	84905-80-6	Contains (regardless of intentional or impurities)	chemical products
17226	Sodium [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-hydroxybenzenesulphonamidato(2-)](4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulphonamidato(2-)]cobaltate(1-)	84912-03-8	Intentional addition / 1%	chemical products
17227	Cobaltate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamidato(2-)]-, hydrogen, compound with 3-[[2-ethylhexyl]oxy]-1-propanamine (1:1)	84912-04-9	Intentional addition / 1%	chemical products
17228	Antimony glucoheptonate hydroxide sodium complexes	84929-82-8	Contains (regardless of intentional or impurities)	chemical products
17229	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-phosphonophenyl]amino)sulfonyl sulfo derivatives, ammonium sodium salts	84929-84-0	Intentional addition / 1,000ppm	chemical products
17230	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfonated, barium salts	84929-85-1	Contains (regardless of intentional or impurities)	chemical products
17231	Cuprate(2-), [N1,N8-dicyano-N15,N22-bis[2-[[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]ethyl]-29H,31H-phthalocyanine-1,8,15,22-tetrasulfonamidato(4-)-N29,N30,N31,N32]-, sodium	84929-86-2	Intentional addition / 1,000ppm	chemical products
17232	Phosphorodithioic acid, O,O-bis(1-methylpropyl) ester, antimony(3+) salt	84949-18-8	Contains (regardless of intentional or impurities)	chemical products
17233	Amines, C10-14-branched and linear alkyl, bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-), (1:1)	84961-40-0	Contains (regardless of intentional or impurities)	chemical products
17234	Amines, C10-14-branched and linear alkyl, bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]chromate(3-), sodium salts	84961-41-1	Contains (regardless of intentional or impurities)	chemical products
17235	Amines, C10-14-branched and linear alkyl, [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](1-[[2-hydroxy-4-nitrophenyl]azo]-3,8-dithio-9-thia-2,4,7-triazadodecane-12-sulfonate sodium complexes	84961-42-2	Intentional addition / 1%	chemical products
17236	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonato(3-)]-, diethanolamine sodium salts	84961-84-2	Contains (regardless of intentional or impurities)	chemical products
17237	Chromate(3-), bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, compound with 3-[[2-ethylhexyl]oxy]-1-propanamine	84961-85-3	Contains (regardless of intentional or impurities)	chemical products
17238	Chromate(3-), [6-[[4-chloro-2-hydroxy-5-methoxyphenyl]azo]-5-hydroxy-1-naphthalenesulfonato(3-)](3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonato(3-)]-, diethanolamine sodium salts	84961-86-4	Contains (regardless of intentional or impurities)	chemical products
17239	Copper, 1-phenyl-7-[2-[[[phenyl(methyl)amino]thioxomethyl]amino]ethyl]-3,8-dithio-9-thia-2,4,7-triazadodecane-12-sulfonate sodium complexes	84961-87-5	Intentional addition / 1,000ppm	chemical products
17240	Manganese, 2-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonate complexes	84962-02-7	Contains (regardless of intentional or impurities)	chemical products
17241	Xanthylium, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, hydrogen bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]chromate(3-), compound with 3-[[2-ethylhexyl]oxy]-1-propanamine	84962-27-6	Contains (regardless of intentional or impurities)	chemical products
17242	Xanthylium, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, hydrogen bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]chromate(3-), compound with ethyl 2-[6-(ethylamino)-3-(ethylimino)-2,7-dimethyl-3H-xanthen-9-yl]benzoate	84962-28-7	Contains (regardless of intentional or impurities)	chemical products
17243	Sodium bis[5-hydroxy-4-[[1-hydroxy-2-naphthyl]azo]-2-methylbenzene-1-sulphonamidato(2-)]chromate(1-)	84962-32-3	Contains (regardless of intentional or impurities)	chemical products
17244	Tin tetrakis(5-oxo-DL-prolinate)	84962-42-5	Contains (regardless of intentional or impurities)	chemical products
17245	Manganese diisononanoate	84962-56-1	Contains (regardless of intentional or impurities)	chemical products
17246	Manganese(II) isodecanoate	84962-57-2	Contains (regardless of intentional or impurities)	chemical products
17247	Manganese(2+) neodecanoate	84962-58-3	Contains (regardless of intentional or impurities)	chemical products
17248	Phenols, ammonia liquor extract	84988-93-2	Contains (regardless of intentional or impurities)	chemical products
17249	Slimes and sludges, tungsten-extraction	84989-01-5	Contains (regardless of intentional or impurities)	chemical products
17250	Tar acids, ethylphenol fraction	84989-03-7	Contains (regardless of intentional or impurities)	chemical products
17251	Tar acids, methylphenol fraction	84989-04-8	Contains (regardless of intentional or impurities)	chemical products
17252	Tar acids, polyalkylphenol fraction	84989-05-9	Contains (regardless of intentional or impurities)	chemical products
17253	Tar acids, xylene fraction	84989-06-0	Contains (regardless of intentional or impurities)	chemical products
17254	Tar acids, 3,5-xylene fraction	84989-07-1	Contains (regardless of intentional or impurities)	chemical products
17255	Distillates (coal tar), naphthalene oils, low in naphthalene	84989-09-3	Contains (regardless of intentional or impurities)	chemical products
17256	Distillates (coal tar), upper, fluorene-free	84989-10-6	Contains (regardless of intentional or impurities)	chemical products
17257	Distillates (coal tar), upper, fluorene rich	84989-11-7	Contains (regardless of intentional or impurities)	chemical products
17258	Extract oils (coal), acidic, tar-base free	84989-12-8	Contains (regardless of intentional or impurities)	chemical products
17259	Chromate(3-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)](2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, ethanolamine sodium salts	84989-19-5	Contains (regardless of intentional or impurities)	chemical products
17260	Chromate(3-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)](2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, sodium	84989-20-8	Contains (regardless of intentional or impurities)	chemical products
17261	Chromate(3-), bis[2-hydroxy-3-[[2-hydroxy-8-[[methoxycarbonyl]amino]-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, 2-(methylamino)ethanol sodium salts	84989-21-9	Contains (regardless of intentional or impurities)	chemical products
17262	Chromate(3-), bis[2-hydroxy-3-[[2-hydroxy-8-[[methoxycarbonyl]amino]-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, sodium	84989-22-0	Contains (regardless of intentional or impurities)	chemical products
17263	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, ethanolamine sodium salts	84989-24-2	Contains (regardless of intentional or impurities)	chemical products
17264	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium triethanolamine salts	84989-25-3	Contains (regardless of intentional or impurities)	chemical products
17265	Chromate(3-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)](3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium	84989-26-4	Contains (regardless of intentional or impurities)	chemical products
17266	Chromate(3-), [2-hydroxy-3-[[2-hydroxy-8-[[methoxycarbonyl]amino]-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)](2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, 2-(methylamino)ethanol sodium salts	84989-27-5	Contains (regardless of intentional or impurities)	chemical products
17267	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (1-methyl-1H-imidazolyl)methyl derivatives, acetates	84989-28-6	Intentional addition / 1,000ppm	chemical products
17268	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (1-methyl-1H-imidazolyl)methyl derivatives, acetates	84989-29-7	Intentional addition / 1,000ppm	chemical products
17269	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (1-methyl-1H-imidazolyl)methyl derivatives, methoxyacetates	84989-30-0	Intentional addition / 1,000ppm	chemical products
17270	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, (1-methyl-1H-imidazolyl)methyl derivatives, sulfamates	84989-31-1	Intentional addition / 1,000ppm	chemical products
17271	Cuprate(1-), [29H,31H-phthalocyaninesulfonato(3-)-N29,N30,N31,N32]-, (1-methyl-1H-imidazolyl)methyl derivatives, hydrogen	84989-32-2	Intentional addition / 1,000ppm	chemical products
17272	Cuprate(1-), [29H,31H-phthalocyaninesulfonato(3-)-N29,N30,N31,N32]-, (1-methyl-1H-imidazolyl)methyl derivatives, hydrogen, acetates	84989-33-3	Intentional addition / 1,000ppm	chemical products
17273	Cuprate(1-), [29H,31H-phthalocyaninesulfonato(3-)-N29,N30,N31,N32]-, (1-methyl-1H-imidazolyl)methyl derivatives, hydrogen, methoxyacetates	84989-34-4	Intentional addition / 1,000ppm	chemical products
17274	Cuprate(1-), [29H,31H-phthalocyaninesulfonato(3-)-N29,N30,N31,N32]-, (1-methyl-1H-imidazolyl)methyl derivatives, hydrogen, sulfamates	84989-35-5	Intentional addition / 1,000ppm	chemical products
17275	Xanthylium, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]chromate(1-)	84989-45-7	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17276	Cobaltate(1-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-hydroxybenzenesulfonamidato(2-)]-, sodium	84989-48-0	Intentional addition / 1%	chemical products
17277	Bis(N,N-dimethylpropane-1,3-diamine-N)[29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]cobalt(1+) chloride	84989-53-7	Intentional addition / 1%	chemical products
17278	Cuprate(3-), [8-hydroxy-7-[[3'-hydroxy-4'-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-3-methoxy[1,1'-biphenyl]-4-yl]azo]-1,8-naphthalenedisulfonato(5-)]-, trisodium	84989-55-9	Intentional addition / 1,000ppm	chemical products
17279	Chromate(3-), bis[6-[[4-chloro-2-hydroxy-5-methoxyphenyl]azo]-5-hydroxy-1-naphthalenesulfonato(3-)]-, diethanolamine sodium salts	85005-53-4	Contains (regardless of intentional or impurities)	chemical products
17280	Cuprate(4-), [3-[1,4-[[2-(ethylsulfonyl)-7-sulfo-6-benzothiazolyl]azo]-2-hydroxy-6-sulfo-1-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)]-, potassium sodium	85005-54-5	Intentional addition / 1,000ppm	chemical products
17281	[Isodecanoato-O](neodecanoato-O)manganese	85005-58-9	Contains (regardless of intentional or impurities)	chemical products
17282	[Isodecanoato-O](isononoato-O)manganese	85005-59-0	Contains (regardless of intentional or impurities)	chemical products
17283	Manganese, (isononoato-O)(isooctanoato-O)-	85005-60-3	Contains (regardless of intentional or impurities)	chemical products
17284	[Isodecanoato-O](isooctanoato-O)manganese	85005-61-4	Contains (regardless of intentional or impurities)	chemical products
17285	6-Chloro-4-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulphophenyl)-1H-pyrazol-4-yl]azo]toluene-3-sulphonic acid, barium salt	85005-78-3	Contains (regardless of intentional or impurities)	chemical products
17286	Barium bis[5-chloro-2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-p-toluenesulfonate]	85005-81-8	Contains (regardless of intentional or impurities)	chemical products
17287	4-[[5-Chloro-4-methyl-2-sulphophenyl]azo]-3-hydroxy-2-naphthoic acid, barium calcium salt	85005-86-3	Contains (regardless of intentional or impurities)	chemical products
17288	3-Hydroxy-4-[[1-sulpho-2-naphthyl]azo]-2-naphthoic acid, barium calcium salt	85005-87-4	Contains (regardless of intentional or impurities)	chemical products
17289	(m-Aminophenyl)metaboric acid hydrochloride	85006-23-1	Intentional addition / 1%	chemical products
17290	Bis(N,N-dimethylpropane-1,3-diamine-N)[2,3,9,10-tetrahydro-29H,31H-dibenzo[b,b']bis[1,4]dithiino[3,2'-1,2'-3'-j]porphyrinato(2-)-N29,N30,N31,N32]cobalt	85006-35-5	Intentional addition / 1%	chemical products
17291	Cobalt(II) bromide hydrate	85017-77-2	Intentional addition / 1%	chemical products
17292	Chromium trichloride	85017-78-3	Intentional addition / 1,000ppm	chemical products
17293	Barium bromide (BaBr <sub>2</sub> ) hydrate	85017-88-5	Intentional addition / 1,000ppm	chemical products
17294	Bis(5-oxo-DL-prolinato-N1,O2)nickel	85026-81-9	Contains (regardless of intentional or impurities)	chemical products
17295	Distillates (coal), coke-oven light oil, naphthalene cut	85029-51-2	Contains (regardless of intentional or impurities)	chemical products
17296	Amines, C10-14-branched and linear alkyl, bis[2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	85029-57-8	Contains (regardless of intentional or impurities)	chemical products
17297	Amines, C10-14-branched and linear alkyl, bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)	85029-58-9	Contains (regardless of intentional or impurities)	chemical products
17298	Amines, C10-14-branched and linear alkyl, [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)	85029-59-0	Contains (regardless of intentional or impurities)	chemical products
17299	Petrolatum (petroleum), alumina-treated	85029-74-9	Contains (regardless of intentional or impurities)	chemical products
17300	Alkanes, C16-35, chloro	85049-26-9	Intentional addition / 1,000ppm	chemical products
17301	Amines, di-C14-18-alkylmethyl, [29H,31H-phthalocyaninedisulfonato(4-)-N29,N30,N31,N32]cuprate(2-)(2:1)	85049-29-2	Intentional addition / 1,000ppm	chemical products
17302	Fatty acids, C8-10-branched, barium salts	85049-40-7	Intentional addition / 1,000ppm	chemical products
17303	Naphthenic acids, cobalt(2+) salts	85049-49-6	Intentional addition / 1%	chemical products
17304	Chromate(1-), bis[2,4-diamino-5-[[2-hydroxy-3,5-dinitrophenyl]azo]benzenesulfonato(2-)]-, sodium	85049-61-2	Contains (regardless of intentional or impurities)	chemical products
17305	Chromate(3-), bis[2-[[[5-[[2-chloro-5-sulphophenyl]azo]-2-hydroxyphenyl]methylene]amino]benzoato(3-)]-, potassium sodium	85049-62-3	Contains (regardless of intentional or impurities)	chemical products
17306	Chromate(3-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, ethanolamine potassium salts	85049-63-4	Contains (regardless of intentional or impurities)	chemical products
17307	Chromate(3-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, potassium	85049-64-5	Contains (regardless of intentional or impurities)	chemical products
17308	Chromate(3-), bis[2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, ethanolamine sodium salts	85049-65-6	Contains (regardless of intentional or impurities)	chemical products
17309	Chromate(3-), bis[2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, 2-(methylamino)ethanol sodium salts	85049-66-7	Contains (regardless of intentional or impurities)	chemical products
17310	Chromate(3-), bis[2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, sodium	85049-67-8	Contains (regardless of intentional or impurities)	chemical products
17311	Chromate(3-), bis[2-hydroxy-3-[[[2-hydroxyphenyl]methylene]amino]-5-nitrobenzenesulfonato(3-)]-, potassium sodium	85049-68-9	Contains (regardless of intentional or impurities)	chemical products
17312	Chromate(3-), bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, sodium	85049-69-0	Contains (regardless of intentional or impurities)	chemical products
17313	Chromate(3-), [2-[[[5-[[2-chloro-5-sulphophenyl]azo]-2-hydroxyphenyl]methylene]amino]benzoato(3-)]2-hydroxy-3-[[[2-hydroxyphenyl]methylene]amino]-5-nitrobenzenesulfonato(3-)]-, potassium sodium	85049-70-3	Contains (regardless of intentional or impurities)	chemical products
17314	Chromate(3-), [2-hydroxy-3-[[2-hydroxy-8-[[methoxycarbonyl]amino]-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, sodium	85049-71-4	Contains (regardless of intentional or impurities)	chemical products
17315	Cobaltate(3-), bis[3-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, sodium	85049-72-5	Intentional addition / 1%	chemical products
17316	Cobaltate(3-), bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, diethanolamine sodium salts	85049-73-6	Intentional addition / 1%	chemical products
17317	Cobaltate(3-), bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, sodium	85049-74-7	Intentional addition / 1%	chemical products
17318	Cobaltate(2-), [4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]3-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, sodium	85049-75-8	Intentional addition / 1%	chemical products
17319	Cobaltate(3-), bis[6-amino-5-[[2-hydroxy-3,5-dinitrophenyl]azo]-1-naphthalenesulfonato(3-)]-, sodium	85049-76-9	Intentional addition / 1%	chemical products
17320	Ethyl 1-ethyl-2-[[3-ethyl-5,6-dimethyl-3H-benzoselenazol-2-ylidene]methyl]-1-butenyl]naphtho[1,2-d]thiazolium sulfate	85050-02-8	Contains (regardless of intentional or impurities)	chemical products
17321	3-Ethyl-2-[[2-[[5-methoxy-3-(4-sulphonatobutyl)benzoselenazol-2(3H)-ylidene]methyl]but-1-enyl]-5,6-dimethylbenzothiazolium	85050-03-9	Contains (regardless of intentional or impurities)	chemical products
17322	[3,5-Bis(trifluoromethyl)phenyl]acetone	85068-32-2	Intentional addition	chemical products
17323	Naphgen [1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphtholato(2-)]1-[[[2-hydroxy-5-nitrophenyl]azo]-2-naphtholato(2-)]chromate(1-), compound with 2,2',2''-nitrotris[ethanol] (1:1)	85068-39-9	Contains (regardless of intentional or impurities)	chemical products
17324	Silicic acid, molybdenum salt, compound with 4,4'-carbonimidoylbis[N,N-dimethylbenzenamine]	85068-46-8	Contains (regardless of intentional or impurities)	chemical products
17325	1-Bromomethyl-3-chloro-2-fluorobenzene	85070-47-9	Contains (regardless of intentional or impurities)	chemical products
17326	[Isononoato-O](neodecanoato-O)manganese	85080-93-9	Contains (regardless of intentional or impurities)	chemical products
17327	[Isooctanoato-O](neodecanoato-O)manganese	85080-94-0	Contains (regardless of intentional or impurities)	chemical products
17328	Hydrogen bis[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphtholato(2-)]chromate(1-), compound with 2,2',2''-nitrotris[ethanol] (1:1)	85085-79-6	Contains (regardless of intentional or impurities)	chemical products
17329	9-[[2-Carboxyphenyl]-3,6-bis(diethylamino)xanthylum bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)	85085-81-0	Contains (regardless of intentional or impurities)	chemical products
17330	Hydrogen [29H,31H-phthalocyanine-2-sulphonato(3-)-N29,N30,N31,N32]cuprate(1-), compound with octadecylamine (1:1)	85085-84-3	Intentional addition / 1,000ppm	chemical products
17331	[Disodium N,N'-[[3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl]bisazo]bis[N-methylaminoacetate]	85098-84-6	Intentional addition	chemical products
17332	2-Chloro-5-methoxy-4-(2-pyridylamino)benzenediazonium tetrafluoroborate	85099-28-1	Intentional addition / 1%	chemical products
17333	4-(Benzoylamino)-2,5-dibutoxybenzenediazonium tetrafluoroborate	85099-30-5	Intentional addition / 1%	chemical products
17334	Trihydrogen bis[3-[[1-(anilino)carbonyl]-2-oxopropyl]azo]-4-hydroxybenzene-1-sulphonato(3-)]chromate(3-), compound with N,N'-bis(o-tolyl)guanidine (1:3)	85099-42-9	Contains (regardless of intentional or impurities)	chemical products
17335	Trihydrogen bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzene-1-sulphonato(3-)]chromate(3-), compound with N,N'-bis(o-tolyl)guanidine (1:3)	85099-44-1	Contains (regardless of intentional or impurities)	chemical products
17336	Trisodium [[[(2-[[4,6-dichloro-1,3,5-triazin-2-yl]amino]ethylamino]sulphonyl)-29H,31H-phthalocyaninetrissulphonato(5-)-N29,N30,N31,N32]cuprate(3-)]	85099-45-2	Intentional addition / 1,000ppm	chemical products
17337	4-Carboxy-2-nitrobenzeneboric acid	85107-54-6	Intentional addition / 1%	chemical products
17338	Distillates (petroleum), hydrodesulfurized thermal cracked middle	85116-53-6	Contains (regardless of intentional or impurities)	chemical products
17339	Distillates (petroleum), catalytic reformed hydrotreated light, C8-12 aromatic fraction	85116-58-1	Contains (regardless of intentional or impurities)	chemical products
17340	Naphtha (petroleum), catalytic reformed light, aromatic-free fraction	85116-59-2	Contains (regardless of intentional or impurities)	chemical products
17341	Naphtha (petroleum), hydrodesulfurized thermal cracked light	85116-60-5	Contains (regardless of intentional or impurities)	chemical products
17342	Naphtha (petroleum), hydrotreated light, cycloalkane-containing	85116-61-6	Contains (regardless of intentional or impurities)	chemical products
17343	Amines, C12-14-branched and linear alkyl, bis[3-[[5-cyano-1,2-dihydro-6-hydroxy-4-methyl-2-oxo-3-pyridinyl]azo]-4-hydroxy-N-3-(1-methylethoxy)propyl]benzenesulfonamidato(2-)]chromate(1-)	85116-65-0	Contains (regardless of intentional or impurities)	chemical products
17344	Amines, C12-14-branched and linear alkyl, bis[2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	85116-66-1	Contains (regardless of intentional or impurities)	chemical products
17345	Fatty acids, vegetable-oil, barium salts	85117-00-6	Intentional addition / 1,000ppm	chemical products
17346	Gas oils (petroleum), hydrodesulfurized coker heavy vacuum	85117-03-9	Contains (regardless of intentional or impurities)	chemical products
17347	Waste solids, cadmium-electrolysis, thallium-rich - Residue obtained in the electrolysis of cadmium, composed primarily of thallium chromate. Other non-ferrous metals or metal compounds may also be present.	85117-20-0	Contains (regardless of intentional or impurities)	chemical products
17348	Waste solids, copper-electrolysis, dross - Anode residue composed primarily of the oxides of copper, iron and silicon. It may contain other non-ferrous metals.	85117-21-1	Intentional addition / 1,000ppm	chemical products
17349	Chromate(2-), [2-hydroxybenzoato(2-)-O1,O2][3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium	85117-52-8	Contains (regardless of intentional or impurities)	chemical products
17350	Chromate(2-), [2-hydroxybenzoato(2-)-O1,O2][3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonato(3-)]-, sodium	85117-53-9	Contains (regardless of intentional or impurities)	chemical products
17351	Manganese, 4-[[4-ethoxy-2-sulphophenyl]azo]-3-hydroxy-2-naphthalenecarboxylate barium calcium complexes	85117-59-5	Contains (regardless of intentional or impurities)	chemical products
17352	Manganese, isodecanoate naphthenate complexes	85117-60-8	Contains (regardless of intentional or impurities)	chemical products
17353	Manganese, isononoate naphthenate complexes	85117-61-9	Contains (regardless of intentional or impurities)	chemical products
17354	Manganese, isooctanoate naphthenate complexes	85117-62-0	Contains (regardless of intentional or impurities)	chemical products
17355	Manganese, naphthenate neodecanoate complexes	85117-63-1	Contains (regardless of intentional or impurities)	chemical products
17356	Triammonium tris[sulphato(2-)-O,O']rhodate(3-)	85117-80-2	Contains (regardless of intentional or impurities)	chemical products
17357	2-(Bromomethyl)-1,4-difluorobenzene	85117-99-3	Intentional addition / 1,000ppm	chemical products
17358	2-(Bromomethyl)-1,3-difluorobenzene	85118-00-9	Contains (regardless of intentional or impurities)	chemical products
17359	4-(Bromomethyl)-1,2-difluorobenzene	85118-01-0	Intentional addition / 1,000ppm	chemical products
17360	(2-Ethylhexanoato-O)(isooctanoato-O)copper	85118-11-2	Intentional addition / 1,000ppm	chemical products
17361	(2-Ethylhexanoato-O)(isononoato-O)copper	85118-12-3	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17362	(2-Ethylhexanoato-O)(isodcanoato-O)copper	85118-13-4	Intentional addition / 1,000ppm	chemical products
17363	Sodium [2-[[[5-[(2-chloro-5-sulphophenyl)azo]-2-hydroxyphenyl]methylene]amino]benzoato(3-)]hydroxychromate(1-)	85118-16-7	Contains (regardless of intentional or impurities)	chemical products
17364	Potassium [2-[[[5-[(2-chloro-5-sulphophenyl)azo]-2-hydroxyphenyl]methylene]amino]benzoato(3-)]hydroxychromate(1-)	85118-17-8	Contains (regardless of intentional or impurities)	chemical products
17365	Sodium hydroxy(3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]naphthalene-1-sulphonato(3-)]chromate(1-)	85118-18-9	Contains (regardless of intentional or impurities)	chemical products
17366	Hydrogen hydroxy(3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]naphthalene-1-sulphonato(3-)]chromate(1-), compound with 2,2'-iminodithanol (1:1)	85118-20-3	Contains (regardless of intentional or impurities)	chemical products
17367	(2-Ethylhexanoato-O)(neodecanoato-O)nickel	85135-77-9	Contains (regardless of intentional or impurities)	chemical products
17368	(2-Ethylhexanoato-O)(neodecanoato-O)cobalt	85135-78-0	Intentional addition / 1%	chemical products
17369	(2-Ethylhexanoato-O)(neodecanoato-O)cobalt	85135-79-1	Intentional addition / 1%	chemical products
17370	Tetrasodium 8-hydroxy-7-[[4-[[1-hydroxy-6-(phenylamino)-3-sulphonato-2-naphthyl]azo]-3,3'-dimethoxy(1,1'-biphenyl)-4-yl]azo]naphthalene-1,3,6-trisulphonate	85135-91-7	Intentional addition	chemical products
17371	Chromate(2-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-[4-[(1-oxo-2-propenyl)amino]phenyl]-1H-pyrazol-4-yl]azo]-5-nitrobenzoato(2-)](2-)[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl]-1H-pyrazol-4-yl]azo]-4-sulfobenzoato(3-)]-, disodium	85136-44-3	Contains (regardless of intentional or impurities)	chemical products
17372	Bis[5-oxo-DL-prolinate-N1,O2]manganese	85136-48-7	Contains (regardless of intentional or impurities)	chemical products
17373	Tris[5-oxo-DL-prolinate-N1,O2]iron	85136-49-8	Intentional addition / 1%	chemical products
17374	6-hydroxy-1-(3-isopropoxypropyl)-4-methyl-2-oxo-5-[4-(phenylazo)phenylazo]-1,2-dihydro-3-pyridinecarbonitrile	85136-74-9	Contains (regardless of intentional or impurities)	chemical products
17375	Benzoic acid, 5-[[4-[[6-amino-5-(1H-benzotriazol-4-ylazo)-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3,3'-dimethoxy(1,1'-biphenyl)-4-yl]azo]-2-hydroxy-4-methyl-, disodium salt	85153-20-4	Intentional addition	chemical products
17376	(2-Hydroxyethyl)dimethylolctylammonium perchlorate	85153-31-7	Intentional addition / 1,000ppm	chemical products
17377	(Isodecanoato-O)(isooctanoato-O)nickel	85166-19-4	Contains (regardless of intentional or impurities)	chemical products
17378	(1S)-(1+)-Pinediol-1-chloro-3-methylbutane-1-borionate	85167-14-2	Intentional addition / 1%	chemical products
17379	Sodium bis[2,4-dihydro-4-[[2-hydroxy-5-mesylphenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]cobaltate(1-)	85168-70-3	Intentional addition / 1%	chemical products
17380	Sodium bis[N-(7-hydroxy-8-[[2-hydroxy-5-mesylphenyl]azo]-1-naphthyl)acetamidato(2-)]cobaltate(1-)	85168-71-4	Intentional addition / 1%	chemical products
17381	Chromate(1-), [N-[8-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]acetamidato(2-)](methyl [8-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]carbamato(2-)]-, hydrogen	85168-72-5	Contains (regardless of intentional or impurities)	chemical products
17382	Cobaltate(1-), [2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](N-(7-hydroxy-8-[[2-hydroxy-5-(methylsulfonyl)phenyl]azo]-1-naphthalenyl)acetamidato(2-)]-, hydrogen	85168-73-6	Intentional addition / 1%	chemical products
17383	Citric acid, manganese sodium salt	85169-06-8	Contains (regardless of intentional or impurities)	chemical products
17384	Manganese(II) fumarate	85169-07-9	Contains (regardless of intentional or impurities)	chemical products
17385	Sodium [N-(2-[[[carboxymethyl(2-hydroxyethyl)amino]ethyl]-N-(2-hydroxy-5-methylphenyl)methyl]glycinate(4-)]ferrate(1-)	85169-09-1	Intentional addition / 1%	chemical products
17386	[mu-5-Amino-1,3,3-trimethylcyclohexane-1-(methylamino)-nN]]hexachlorodiboron	85169-10-4	Intentional addition / 1%	chemical products
17387	Orthoboric acid, compound with N,N-diethylprop-2-enylamine	85169-33-1	Intentional addition / 1%	chemical products
17388	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)](1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, sodium triethanolamine salts	85186-12-5	Contains (regardless of intentional or impurities)	chemical products
17389	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)](1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, sodium triethanolamine salts	85186-13-6	Contains (regardless of intentional or impurities)	chemical products
17390	Cuprate(2-), [mu-[[3,3'-methylenebis[4,6-dihydroxy-3,1-phenylene]azo]bis[2(or 4)-hydroxy-5-nitrobenzenesulfonato]](6-)]di-, sodium	85186-14-7	Intentional addition / 1,000ppm	chemical products
17391	Cuprate(2-), [mu-[[3,3'-methylenebis[4,6-dihydroxy-3,1-phenylene]azo]bis[4-hydroxy-5-nitrobenzenesulfonato]](6-)]di-, sodium	85186-15-8	Intentional addition / 1,000ppm	chemical products
17392	Cuprate(2-), [mu-[[3,3'-methylenebis[6-[[2,4-dihydroxy-5-[[4-sulfo(phenyl)azo]phenyl]azo]benzoato]](6-)]di-, sodium	85186-16-9	Intentional addition / 1,000ppm	chemical products
17393	Cuprate(4-), [mu-[[3,3'-[[3,3'-dihydroxy(1,1'-biphenyl)-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulfonato]](8-)]di-, sodium	85186-17-0	Intentional addition / 1,000ppm	chemical products
17394	3H-Indolium, 2-[3-(1,3-dihydro-1,3,3-trimethyl-2H-indol-2-ylidene)-1-propenyl]-1,3,3-trimethyl-, reaction products with aluminum hydroxide and barium sulfate (1:1)	85186-32-9	Intentional addition / 1,000ppm	chemical products
17395	Molybdenum, bis[bis(phenylmethyl)carbamodithioato]-mu-oxodioxidi-, sulfurized	85186-35-2	Intentional addition / 1,000ppm	chemical products
17396	Molybdenum, bis(dicyclohexylcarbamodithioato)di-mu-oxodioxidi-, sulfurized	85186-36-3	Intentional addition / 1,000ppm	chemical products
17397	Sulfuric acid, barium salt (1:1), reaction products with aluminum hydroxide and 4,4'-carbonimidoylbis[N,N-dimethylbenzenamine]	85186-44-3	Intentional addition / 1,000ppm	chemical products
17398	Amines, C10-14-branched and linear alkyl, compounds with sodium hydrogen [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)](1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(2-)	85186-62-5	Contains (regardless of intentional or impurities)	chemical products
17399	Amines, C10-14-branched and linear alkyl, [2,4-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	85186-63-6	Contains (regardless of intentional or impurities)	chemical products
17400	Amines, C10-14-branched and linear alkyl, [1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)](1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)	85186-64-7	Contains (regardless of intentional or impurities)	chemical products
17401	Amines, C10-14-branched and linear alkyl, bis[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]cobaltate(1-)	85186-65-8	Intentional addition / 1%	chemical products
17402	Amines, C10-14-branched and linear alkyl, bis[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)	85186-66-9	Contains (regardless of intentional or impurities)	chemical products
17403	Amines, C10-14-branched and linear alkyl, bis[1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)	85186-67-0	Contains (regardless of intentional or impurities)	chemical products
17404	Amines, C10-14-branched and linear alkyl, bis[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]cobaltate(1-)	85186-68-1	Intentional addition / 1%	chemical products
17405	Amines, C10-14-branched and linear alkyl, compounds with sodium hydrogen bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]chromate(3-)	85186-69-2	Contains (regardless of intentional or impurities)	chemical products
17406	Amines, C10-14-branched and linear alkyl, compounds with sodium hydrogen [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)](1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(2-)	85186-70-5	Contains (regardless of intentional or impurities)	chemical products
17407	Slags, chromium-manufacturing - By-product from production of chromium that is a composite of oxides of aluminum and chromium.	85187-07-1	Intentional addition / 1,000ppm	chemical products
17408	Slags, silicochromium-manufacturing - By-product from production of silicochrome alloy that is a composite of oxides of aluminum, calcium, chromium, magnesium and silicon.	85187-09-3	Intentional addition / 1,000ppm	chemical products
17409	Copper(2+) glycerol phosphate	85187-41-3	Intentional addition / 1,000ppm	chemical products
17410	Cobalt(II) fumarate	85187-42-4	Intentional addition / 1%	chemical products
17411	Ferrate(3-), tris[5,6-diamino-1,3-naphthalenedisulfonato(2-)-N,N]-, tripotassium	85187-44-6	Intentional addition / 1%	chemical products
17412	Bis[1,2,3,6-tetrahydro-2,6-dioxopyrimidine-4-carboxylato-N3,O4]iron	85187-45-7	Intentional addition / 1%	chemical products
17413	Cobaltate(1-), bis[3-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, sodium	85187-58-2	Intentional addition / 1%	chemical products
17414	2,5-Dimethylphenylboronic acid	85199-06-0	Intentional addition / 1%	chemical products
17415	Bis[5-oxo-DL-prolinate-N1,O2]iron	85200-40-4	Intentional addition / 1%	chemical products
17416	Amines, C12-18-alkyl, bis[2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]cobaltate(1-)	85203-44-7	Intentional addition / 1%	chemical products
17417	Copper, 2-ethylhexanoate naphthenate complexes	85203-72-1	Intentional addition / 1,000ppm	chemical products
17418	2-Naphthalenol, 1-[[2-methyl-4-[(2-methylphenyl)azo]phenyl]azo]-, ar-styrenated	85203-90-3	Intentional addition / 1,000ppm	chemical products
17419	Cobalt glycerol phosphate	85204-09-7	Intentional addition / 1%	chemical products
17420	Dimethyl tris(methylarsenate)	85237-42-9	Contains (regardless of intentional or impurities)	chemical products
17421	[Decachloro-29H,31H-phthalocyaninato-N29,N30,N31,N32]copper	85237-49-6	Intentional addition / 1,000ppm	chemical products
17422	[Heptabromononachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	85237-50-9	Intentional addition / 1,000ppm	chemical products
17423	[Tridecabromotrichloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	85237-51-0	Intentional addition / 1,000ppm	chemical products
17424	Pentachromium dihydroxide pentasulphate	85251-54-3	Intentional addition / 1,000ppm	chemical products
17425	9-Octadecenoic acid (Z)-, 2,3-dihydroxypropyl ester, reaction products with boric acid (H3BO3)	85251-55-4	Intentional addition / 1%	chemical products
17426	Chromium, 4-hydroxy-3-[(2-hydroxy-3,5-dinitrophenyl)azo]-6(or 7)-[[sulfo(methyl)amino]-2-naphthalenesulfonate sodium complexes	85251-86-1	Intentional addition / 1,000ppm	chemical products
17427	Dihydrogen [2-[[[4-hydroxy-3-[(2-hydroxyphenyl)amino]phenyl]sulphony]amino]benzoato(3-)](1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalolato(2-)]chromate(2-)	85252-26-2	Contains (regardless of intentional or impurities)	chemical products
17428	2-Hydroxy-5,6-ditetracycl-1,3,2-benzodioxaborole	85252-27-3	Intentional addition / 1%	chemical products
17429	(Z)-Octadec-9-enylamine, compound with 2-hydroxy-5,6-ditetracycl-1,3,2-benzodioxaborole (1:1)	85252-28-4	Intentional addition / 1%	chemical products
17430	Bis[bis(2-hydroxyethyl)ammonium] (2-hydroxyethyl)ammonium orthoborate	85252-30-8	Intentional addition / 1%	chemical products
17431	Molybdenum zinc oxide (Mo3Zn3O8)	85255-51-2	Intentional addition / 1,000ppm	chemical products
17432	Bis[N-(2,4-dimethoxyphenyl)-2,3-bis(hydroxyimino)butylramidato-N2,N3]nickel	85269-39-2	Contains (regardless of intentional or impurities)	chemical products
17433	Hydrogen [bis[[3-(dimethylamino)propyl]amino]sulphonyl]-29H,31H-phthalocyaninesulphonato(3-)-N29,N30,N31,N32]cuprate(1-)	85269-40-5	Intentional addition / 1,000ppm	chemical products
17434	Hydrogen [tris[[3-(dimethylamino)propyl]amino]sulphonyl]-29H,31H-phthalocyaninesulphonato(3-)-N29,N30,N31,N32]cuprate(1-)	85269-41-6	Intentional addition / 1,000ppm	chemical products
17435	[N,N',N''-Tris(carboxymethyl)-N,N,N',N'',N''-hexamethyl-29H,31H-phthalocyaninetrimethylammoniumato(5-)-N29,N30,N31,N32]copper	85269-42-7	Intentional addition / 1,000ppm	chemical products
17436	[N,N',N''-Tetrakis(carboxymethyl)-N,N,N',N'',N''-octamethyl-29H,31H-phthalocyaninetetramethylammoniumato(6-)-N29,N30,N31,N32]copper	85269-43-8	Intentional addition / 1,000ppm	chemical products
17437	Potassium [N,N',N''-Tetrakis(carboxymethyl)-N,N,N',N'',N''-octamethylsulpho-29H,31H-phthalocyaninetetramethylammoniumato(7-)-N29,N30,N31,N32]cuprate(1-)	85269-44-9	Intentional addition / 1,000ppm	chemical products
17438	Cuprate(4-), [m-[[7-(6-chloro-1,3,5-triazine-2,4-diyldimino]bis[4-hydroxy-3-[(2-hydroxy-5-sulfo(phenyl)azo]-2-naphthalenesulfonato(8-)]di-, tetrasodium	85269-51-8	Intentional addition / 1,000ppm	chemical products
17439	Cuprate(4-), [mu-[[7-[[4-chloro-6-[[6-[[3-chloro-2-hydroxy-5-sulfo(phenyl)azo]-5-hydroxy-7-sulfo-2-naphthalenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[(2-hydroxy-5-sulfo(phenyl)azo]-2-naphthalenesulfonato(8-)]di-, tetrasodium	85269-52-9	Intentional addition / 1,000ppm	chemical products
17440	Cuprate(4-), [mu-[[7-(6-chloro-1,3,5-triazine-2,6-diyldimino]bis[3-[[3-chloro-2-hydroxy-5-sulfo(phenyl)azo]-4-hydroxy-2-naphthalenesulfonato(8-)]di-, tetrasodium	85269-53-0	Intentional addition / 1,000ppm	chemical products
17441	Sodium [chloro-29H,31H-phthalocyaninesulphonato(3-)-N29,N30,N31,N32]cuprate(1-)	85281-56-7	Intentional addition / 1,000ppm	chemical products
17442	Potassium [N,N',N''-tris(carboxymethyl)-N,N,N',N'',N''-hexamethylsulpho-29H,31H-phthalocyaninetrimethylammoniumato(6-)-N29,N30,N31,N32]cuprate(1-)	85283-48-3	Intentional addition / 1,000ppm	chemical products
17443	Hydrogen bis[hexane-1,6-diolato(2-)-O]borate(1-), compound with 2,2'-iminodithanol (1:1)	85283-50-7	Intentional addition / 1%	chemical products
17444	Hydrogen bis[hexane-1,6-diolato(2-)-O]borate(1-), compound with 2,2'-nitrioltriethanol (1:1)	85283-51-8	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17445	Hydrogen bis[2,2-dimethylpropane-1,3-diolato(2-)-O,O']borate(1-), compound with 2,2,2'-nitrioltriethanol (1:1)	85283-53-0	Intentional addition / 1%	chemical products
17446	Hydrogen bis[2,2-dimethylpropane-1,3-diolato(2-)-O,O']borate(1-), compound with 2,2'-iminodiethanol (1:1)	85283-54-1	Intentional addition / 1%	chemical products
17447	2,7-Naphthalenedisulfonic acid, 4-[[4-[[2,4-diamino-5-sulfonylphenoxy]azo]-3,3-dimethoxy[1,1'-biphenyl]-4-yl]azo]-3-hydroxy-, sodium salt, compound with 2,2,2'-nitrioltris(2,1-ethanedioxy)tris[ethanol]	85283-97-2	Intentional addition	chemical products
17448	2,7-Naphthalenedisulfonic acid, 4-amino-6-[[4-[[2,4-diamino-5-sulfonylphenoxy]azo]-3,3-dimethoxy[1,1'-biphenyl]-4-yl]azo]-5-hydroxy-3-[[4-(nitrophenyl)azo]-], sodium salt, compound with 2,2,2'-nitrioltris(2,1-ethanedioxy)tris[ethanol]	85283-98-3	Intentional addition	chemical products
17449	Nickel, bis(disononylcarbamodithioato-)	85298-61-9	Contains (regardless of intentional or impurities)	chemical products
17450	Chromate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]hydroxy-, NN'-bis(2-methylphenyl)guanidine sodium complexes	85305-02-8	Contains (regardless of intentional or impurities)	chemical products
17451	Slags, aluminum-smelting	85305-04-0	Intentional addition / 1,000ppm	chemical products
17452	Slags, aluminum-smelting, chloride-low	85305-05-1	Intentional addition / 1,000ppm	chemical products
17453	Slags, zinc-smelting	85305-07-3	Intentional addition / 1,000ppm	chemical products
17454	1-Hexene, 1-bromo-2-methyl-, (E)-	85336-71-6	Intentional addition / 1,000ppm	chemical products
17455	1-Hexene, 1-bromo-2-methyl-, (Z)-	85336-72-7	Intentional addition / 1,000ppm	chemical products
17456	Boric acid (H3BO3), reaction products with (Z)-2-(9-octadecylamino)ethanol	85338-10-9	Intentional addition / 1%	chemical products
17457	Copper, [N,N,N'-triethyl-29H,31H-phthalocyaninetrimesathenamato(2-)-N29,N30,N31,N32]-, tris(C10-14-alkylbenzenesulfonato)	85338-12-1	Intentional addition / 1,000ppm	chemical products
17458	Cuprate(2-), [4-[[4-[[4-[[4,5-dihydro-3-methyl-1-(2-methyl-4-sulfonylphenoxy)-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxyphenyl]methyl]phenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-3-methylbenzenesulfonato(4-)]-, sodium	85338-13-2	Intentional addition / 1,000ppm	chemical products
17459	Cuprate(2-), [mu-[[4,4'-[methylenebis(2-hydroxy-4,1-phenylene)azo(4,5-dihydro-3-methyl-5-oxo-1H-pyrazole-4,1-diy)]bis(3-methylbenzenesulfonato)](6-)]di-, sodium	85338-14-3	Intentional addition / 1,000ppm	chemical products
17460	Cuprate(3-), [29H,31H-phthalocyaninetrimesathenamato(2-)-N29,N30,N31,N32]-, compounds with piperazine	85338-15-4	Intentional addition / 1,000ppm	chemical products
17461	Cuprate(4-), [mu-[[3,3'-methylenebis(6-[[5-[[2,4-disulfonylphenoxy]azo]-2,4-dihydroxyphenyl]azo]benzoato)](6-)]di-, sodium	85338-16-5	Intentional addition / 1,000ppm	chemical products
17462	Diisodecyl 2,2'-[[dibutylstannylene]bis(thio)]diacetate	85371-54-6	Contains (regardless of intentional or impurities)	chemical products
17463	1H-1,2,4-Triazolium, 3(or 5)-[[4-[ethyl(phenylmethyl)amino]phenyl]azo]-1,4-dimethyl-, tetrafluoroborate(1-)	85371-59-1	Intentional addition / 1%	chemical products
17464	2,2'-[[3,3'-Dimethoxy(1,1'-biphenyl)-4,4'-diyl]bis(iminoethylene)]bis(1,3,3-trimethyl-3H-indolium)bis(tetrafluoroborate(1-))	85391-36-2	Intentional addition / 1%	chemical products
17465	Barium bis[2-(2-hydroxy-1-naphthyl)azo]-5-methoxybenzenesulfonate	85391-55-5	Contains (regardless of intentional or impurities)	chemical products
17466	Dibutylbis(octadeca-9(2Z),12(2Z)-dienyloxy)stannane	85391-79-3	Contains (regardless of intentional or impurities)	chemical products
17467	Piperoyl (Z,Z,2)-6,6,13,13-tetrabutyl-4,8,11,15-tetraoxa-5,7,12,14-tetraoxa-6,13-distannooctadeca-2,9,16-triene-dioate	85391-80-6	Contains (regardless of intentional or impurities)	chemical products
17468	2,4-Dibutyl-2,4-bis(dodecylthio)-7-(ethylthio)-1,5-dioxo-3-thia-2,4-distanacycloundecane-6,11-dione	85391-81-7	Contains (regardless of intentional or impurities)	chemical products
17469	2-Methyl-1H-imidazole, copper(1+) salt	85392-46-7	Intentional addition / 1,000ppm	chemical products
17470	Tris(5-oxo-DL-prolinate-N1,O2)chromium	85392-56-9	Intentional addition / 1,000ppm	chemical products
17471	[mu-[[3,3'-[Methylenebis(4,6-dihydroxy-m-phenylene)azo]]bis(4-hydroxy-5-nitrobenzenesulfonato)](6-)]diiron	85392-58-1	Intentional addition / 1%	chemical products
17472	Iron, [mu-[[3-[[5-[[2,4-dihydroxy-5-[[2-hydroxy-3-nitro-5-sulfonylphenoxy]azo]phenyl]methyl]-2,4-dihydroxyphenyl]azo]-2-hydroxy-5-nitrobenzenesulfonato(6-)]di-	85392-59-2	Intentional addition / 1%	chemical products
17473	9-(2-Carboxyphenyl)-3,6-bis(diethylamino)xanthylum [9-[[5-chloro-2-hydroxyphenyl]azo]-7-hydroxynaphthalene-1,3-disulphonato(4-)]chromate(1-)	85392-61-6	Contains (regardless of intentional or impurities)	chemical products
17474	Sodium [4-amino-5-hydroxy-3-[[2-hydroxy-3,5-dinitrophenyl]azo]-6-nitronaphthalene-1-sulphonato(3-)]hydroxychromate(1-)	85392-63-8	Contains (regardless of intentional or impurities)	chemical products
17475	Potassium difluorodihydroxyborate(1-)	85392-66-1	Intentional addition / 1%	chemical products
17476	Copper, [N,N,N'-tris(3-ethoxypropyl)-29H,31H-phthalocyanine-C.C.C.-trisulfonamido(2-)-N29,N30,N31,N32]-	85392-74-1	Intentional addition / 1,000ppm	chemical products
17477	Tin(2+) (9Z,12Z,15Z)-9,12,15-octadecatrienoate	85392-75-2	Contains (regardless of intentional or impurities)	chemical products
17478	Tin(2+) myristate	85392-76-3	Contains (regardless of intentional or impurities)	chemical products
17479	Chromate(2-), [2-[[[4-hydroxy-3-[[2-hydroxyphenyl]methylene]amino]phenyl]sulfonyl]amino]benzoato(3-)]-[1-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, potassium sodium	85407-92-7	Contains (regardless of intentional or impurities)	chemical products
17480	Chromate(3-), bis[4-[[2,6-dihydroxy-3-[[2-hydroxy-3,5-dinitrophenyl]azo]phenyl]azo]-3-methylbenzenesulfonato(3-)]-, sodium	85407-93-8	Contains (regardless of intentional or impurities)	chemical products
17481	Sulfamic acid, reaction products with ammonia, borax and phosphoric acid	85408-27-1	Intentional addition / 1%	chemical products
17482	Amines, C12-14-tert-alkyl, bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)	85408-46-4	Contains (regardless of intentional or impurities)	chemical products
17483	Amines, C10-18-alkyldimethyl, N-oxides	85408-48-6	Intentional addition / 1%	chemical products
17484	Amines, C12-16-alkyldimethyl, N-oxides	85408-49-7	Intentional addition / 1%	chemical products
17485	Amines, C10-14-branched and linear alkyl, compounds with 9-(2-carboxyphenyl)-3,6-bis(diethylamino)xanthylum and trihydrogen [[[(2-methoxyethyl)amino]sulfonyl]-29H,31H-phthalocyaninetrimesathenamato(2-)-N29,N30,N31,N32]cuprate(3-)	85408-53-3	Intentional addition / 1,000ppm	chemical products
17486	Quaternary ammonium compounds, benzyl-C12-14-alkyldimethyl, chlorides	85409-22-9	Intentional addition / 1,000ppm	chemical products
17487	Quaternary ammonium compounds, C12-14-alkyl[(ethylphenyl)methyl]dimethyl, chlorides	85409-23-0	Intentional addition / 1,000ppm	chemical products
17488	Sodium difluorodihydroxyborate(1-)	85409-42-3	Intentional addition / 1%	chemical products
17489	Bis(1,1'-biphenyl-4-yl)iodochromium	85409-47-8	Intentional addition / 1,000ppm	chemical products
17490	Sodium 3-tridecylbenzenesulfonate	85409-86-5	Intentional addition / 1%	chemical products
17491	Copper, [N,N'-bis(3-ethoxypropyl)-29H,31H-phthalocyanine-C.C.-disulfonamido(2-)-N29,N30,N31,N32]-	85410-17-9	Intentional addition / 1,000ppm	chemical products
17492	Alcohols, C10-18, ethoxylated	85422-93-1	Intentional addition / 1%	chemical products
17493	Tris(5-oxo-L-prolinate-N1,O2)chromium	85440-80-8	Intentional addition / 1,000ppm	chemical products
17494	Hydrogen [3-[1-(aminocarbonyl)-2-oxopropyl]azo]-2-hydroxy-5-nitrobenzene-1-sulphonato(3-)]hydroxychromate(1-)	85443-53-4	Contains (regardless of intentional or impurities)	chemical products
17495	Hydrogen hydroxy(2-hydroxy-3-[[2-hydroxybenzylidene]amino]-5-nitrobenzenesulfonato(3-)-N3,O2,O3)chromate(1-), compound with 2-aminoethanol (1:1)	85443-55-6	Contains (regardless of intentional or impurities)	chemical products
17496	[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzene-1-sulphonamido(2-)]hydroxychromium	85443-56-7	Intentional addition / 1,000ppm	chemical products
17497	Sodium [4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxynaphthalene-1-sulphonato(3-)]hydroxychromate(1-)	85443-57-8	Contains (regardless of intentional or impurities)	chemical products
17498	Hydrogen [4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxynaphthalene-1-sulphonato(3-)]hydroxychromate(1-), compound with 2-(methylamino)ethanol (1:1)	85443-59-0	Contains (regardless of intentional or impurities)	chemical products
17499	Chromate(1-), [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(3-)]hydroxy-, hydrogen	85443-60-3	Contains (regardless of intentional or impurities)	chemical products
17500	Sodium [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxybenzene-1-sulphonato(3-)]hydroxychromate(1-)	85443-61-4	Contains (regardless of intentional or impurities)	chemical products
17501	Hydrogen [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxybenzene-1-sulphonato(3-)]hydroxychromate(1-), compound with 2-aminoethanol (1:1)	85443-62-5	Contains (regardless of intentional or impurities)	chemical products
17502	Chromate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]hydroxy-, hydrogen	85443-63-6	Contains (regardless of intentional or impurities)	chemical products
17503	Hydrogen [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]hydroxychromate(1-), compound with 2-aminoethanol (1:1)	85443-64-7	Contains (regardless of intentional or impurities)	chemical products
17504	9-(2-Carboxyphenyl)-3,6-bis(diethylamino)xanthylum [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]hydroxychromate(1-)	85443-66-9	Intentional addition / 1,000ppm	chemical products
17505	Chromate(1-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]hydroxy-, hydrogen, compound with 3-[[2-(ethylhexyloxy)-1-propanamine (1:1)]	85443-67-0	Contains (regardless of intentional or impurities)	chemical products
17506	Hydrogen [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]hydroxychromate(1-), compound with 2,2'-iminodiethanol (1:1)	85443-68-1	Contains (regardless of intentional or impurities)	chemical products
17507	Hydrogen [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]hydroxychromate(1-), compound with 2-aminoethanol (1:1)	85443-70-5	Contains (regardless of intentional or impurities)	chemical products
17508	Chromate(1-), [5-[[5-chloro-2-hydroxyphenyl]azo]-6-hydroxy-2-naphthalenesulfonato(3-)]hydroxy-, sodium	85452-86-4	Contains (regardless of intentional or impurities)	chemical products
17509	Chromate(1-), hydroxy(2-hydroxy-3-[[2-hydroxy-3-nitrophenyl]methylene]amino)-5-nitrobenzenesulfonato(3-)]-, hydrogen, compound with 3-[[2-(ethylhexyloxy)-1-propanamine (1:1)]	85455-32-9	Contains (regardless of intentional or impurities)	chemical products
17510	Hydrogen hydroxy(2-hydroxy-3-[[2-hydroxy-4-nitrobenzylidene]amino]-5-nitrobenzenesulfonato(3-)]chromate(1-), compound with 2-[[2-(ethylhexyloxy)propyl]amine (1:1)	85455-34-1	Contains (regardless of intentional or impurities)	chemical products
17511	Chromate(2-), [5-chloro-2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonato(3-)]-[4-[[2-chloro-4-nitrophenyl]azo]-2-[[2-hydroxy-5-nitrophenyl]imino]methyl]phenolato(2-)]-, lithium sodium	85480-61-1	Contains (regardless of intentional or impurities)	chemical products
17512	Chromate(2-), [1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonato(3-)]-, lithium sodium	85480-62-2	Contains (regardless of intentional or impurities)	chemical products
17513	Chromate(2-), [4-[[2-chloro-4-nitrophenyl]azo]-2-[[2-hydroxy-5-nitrophenyl]imino]methyl]phenolato(2-)]-[2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, lithium sodium	85480-63-3	Contains (regardless of intentional or impurities)	chemical products
17514	Chromate(2-), [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, lithium sodium	85480-64-4	Contains (regardless of intentional or impurities)	chemical products
17515	Chromate(7-), bis[5-[[4-chloro-6-[[5-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-sulfonylphenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenedisulfonato(5-)]-, lithium sodium	85480-65-5	Contains (regardless of intentional or impurities)	chemical products
17516	Cuprate(1-), [29H,31H-phthalocyaninesulfonato(3-)-N29,N30,N31,N32]-, hydrogen, compound with 2,2'-C10-14-alkylimino]bis[ethanol]	85480-66-6	Intentional addition / 1,000ppm	chemical products
17517	Cuprate(2-), [7-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-4-hydroxy-3-[[2-hydroxy-4-sulfonylphenoxy]azo]-2-naphthalenesulfonato(4-)]-, potassium sodium	85480-67-7	Intentional addition / 1,000ppm	chemical products
17518	Cuprate(3-), [bis[[4-[[4-nitro-2-sulfonylphenyl]amino]phenyl]amino]sulfonyl]-29H,31H-phthalocyaninesulfonato(5-)-N29,N30,N31,N32]-, sodium	85480-68-8	Intentional addition / 1,000ppm	chemical products
17519	Cuprate(4-), [7-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-4-hydroxy-3-[[2-hydroxy-4,7-disulfo-1-naphthalenyl]azo]-1,5-naphthalenedisulfonato(6-)]-, lithium potassium sodium	85480-69-9	Intentional addition / 1,000ppm	chemical products
17520	Nickel, 2,2'-thiois(4-nonylphenol) complexes	85480-75-7	Contains (regardless of intentional or impurities)	chemical products
17521	Cuprate(4-), [tris[[4-[[4-nitro-2-sulfonylphenyl]amino]phenyl]amino]sulfonyl]-29H,31H-phthalocyaninesulfonato(6-)-N29,N30,N31,N32]-, sodium	85480-78-0	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17522	1,2-Benzenedicarboxylic acid, diundecyl ester, branched and linear	85507-79-5	Intentional addition / 1,000ppm	chemical products
17523	Chromate(2-), [4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfonylphenyl]azo]-6-[[sulfomethylamino]-2-naphthalenesulfonato(5-)]-], sodium	85507-82-0	Contains (regardless of intentional or impurities)	chemical products
17524	Stannane, dibutyl-, bis(C8-18 and C18-unsaturated fatty acyloxy) derivatives	85508-00-5	Intentional addition	chemical products
17525	N-[2-[[2-Chloro-4,6-dinitrophenyl]azo]-5-(diallylamino)-4-methoxyphenyl]acetamide	85508-41-4	Contains (regardless of intentional or impurities)	chemical products
17526	[Isodecanoato-O](neodecanoato-O)nickel	85508-42-5	Contains (regardless of intentional or impurities)	chemical products
17527	Nickel(II) isodecanoate	85508-43-6	Contains (regardless of intentional or impurities)	chemical products
17528	Nickel(2+) neodecanoate	85508-44-7	Contains (regardless of intentional or impurities)	chemical products
17529	(2-Ethylhexanoato-O)(isononanoato-O)nickel	85508-45-8	Contains (regardless of intentional or impurities)	chemical products
17530	(isononanoato-O)(isooctanoato-O)nickel	85508-46-9	Contains (regardless of intentional or impurities)	chemical products
17531	Fluorazale	85509-19-9	Contains (regardless of intentional or impurities)	chemical products
17532	Solvent naphtha (coal), light	85536-17-0	Contains (regardless of intentional or impurities)	chemical products
17533	Solvent naphtha (coal), coumarone-styrene containing	85536-19-2	Contains (regardless of intentional or impurities)	chemical products
17534	Solvent naphtha (coal), xylene-styrene cut	85536-20-5	Contains (regardless of intentional or impurities)	chemical products
17535	Amines, C10-14-branched and linear alkyl, [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-hydroxychromate(1-)	85536-24-9	Contains (regardless of intentional or impurities)	chemical products
17536	Corundum, molybdenum	85536-66-9	Intentional addition / 1,000ppm	chemical products
17537	Rutile, tin	85536-72-7	Intentional addition / 1,000ppm	chemical products
17538	Rutile, tin zinc	85536-73-8	Intentional addition / 1,000ppm	chemical products
17539	Rutile, vanadium	85536-74-9	Intentional addition / 1%	chemical products
17540	Zircon, silver pink	85536-76-1	Contains (regardless of intentional or impurities)	chemical products
17541	(isononanoato-O)(neodecanoato-O)nickel	85551-28-6	Contains (regardless of intentional or impurities)	chemical products
17542	Fatty acids, C8-10-branched, cobalt salts	85566-25-2	Intentional addition / 1%	chemical products
17543	Manganese, C5-23-branched carboxylate C4-10-fatty acid complexes	85566-72-9	Contains (regardless of intentional or impurities)	chemical products
17544	Sulfuric acid copper(2+) salt (1:1), reaction products with m-cresol, p-cresol, 1,5-naphthalenediamine and sodium sulfide (Na2S(x)), reaction products with sodium sulfide (Na2S)	85567-02-8	Intentional addition / 1,000ppm	chemical products
17545	Disodium [[[(2-chloroethyl)amino]sulfonyl]-2,9H,3,1H-phthalocyaninedisulphonato(4-)-N29,N30,N31,N32]cuprate(2-)	85567-04-0	Intentional addition / 1,000ppm	chemical products
17546	2,5,8,10,13,16,17,20,23-Nonaoxa-1,9-diborabicyclo[7.7.7]tricosane	85567-22-2	Intentional addition / 1%	chemical products
17547	Copper, [[(phenylamino)thioxomethyl]amino]methyl diethylcarbamodithioate complexes	85585-86-0	Intentional addition / 1,000ppm	chemical products
17548	Copper, [N,N,N',N',N',N'-hexaethyl-2,9H,3,1H-phthalocyaninetrimethanaminato(2-)-N29,N30,N31,N32]-, tris(C10-14-alkylbenzenesulfonate)	85585-87-1	Intentional addition / 1,000ppm	chemical products
17549	Copper, [2,9H,3,1H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with 2-[[4-aminophenyl]sulfonyl]ethyl hydrogen sulfate monosodium salt, saponified, sodium salts	85585-88-2	Intentional addition / 1,000ppm	chemical products
17550	Cuprate(3-), [3-hydroxy-4-[[2-hydroxy-5-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(5-)]-], potassium sodium	85585-89-3	Intentional addition / 1,000ppm	chemical products
17551	Cuprate(3-), [4-hydroxy-3-[[2-hydroxy-5-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]azo]-7-[[1-oxo-3-sulfopropyl]amino]-2-naphthalenesulfonato(5-)]-], sodium	85585-90-6	Intentional addition / 1,000ppm	chemical products
17552	Cuprate(4-), [4,5-dihydro-4-[[8-hydroxy-7-[[2-hydroxy-5-methoxy-4-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]azo]-6-sulfo-2-naphthalenyl]azo]-5-oxo-1-(4-sulfonyl)-1H-pyrazole-3-carboxylato(6-)]-], sodium	85585-91-7	Intentional addition / 1,000ppm	chemical products
17553	Nickel, isodecanoate naphthenate complexes	85585-97-3	Contains (regardless of intentional or impurities)	chemical products
17554	Nickel, isononanoate naphthenate complexes	85585-98-4	Contains (regardless of intentional or impurities)	chemical products
17555	Nickel, naphthenate neodecanoate complexes	85585-99-5	Contains (regardless of intentional or impurities)	chemical products
17556	Fatty acids, C9-11-branched, barium salts	85586-14-7	Intentional addition / 1,000ppm	chemical products
17557	Fatty acids, C9-11-branched, calcium salts	85586-15-8	Contains (regardless of intentional or impurities)	chemical products
17558	Tris(2-hydroxyethyl)ammonium bis[3-(oleoyloxy)propane-1,2-diolato(2-)]borate(1-)	85586-41-0	Intentional addition / 1%	chemical products
17559	Bis(2-hydroxyethyl)ammonium bis[3-(oleoyloxy)propane-1,2-diolato(2-)]borate(1-)	85586-42-1	Intentional addition / 1%	chemical products
17560	Hydrogen bis[propane-1,2-diolato(2-)-O]borate(1-), compound with 2,2,2'-nitrioltriethanol (1:1)	85586-43-2	Intentional addition / 1%	chemical products
17561	Hydrogen bis[propane-1,2-diolato(2-)-O]borate(1-), compound with 2,2'-iminodithiethanol (1:1)	85586-44-3	Intentional addition / 1%	chemical products
17562	Hydrogen bis[2-amino-2-methylpropano-1-olato(2-)-N]borate(1-)	85586-45-4	Intentional addition / 1%	chemical products
17563	Bis[1H-1,2,4-triazole-3-sulphonato-N2,O3]nickel	85586-46-5	Contains (regardless of intentional or impurities)	chemical products
17564	13-[2-[[2-[[2-(2-Hydroxyethoxy)ethoxy]ethoxy]ethoxy]-3,6,9,12,14,17,20,23-octa-13-borapentacosane-1,29-diol	85586-65-8	Intentional addition / 1%	chemical products
17565	[19.alpha.]-3,4,16,17-Tetrahydro-16-(methoxycarbonyl)-19-methylxayohimbanium perchlorate	85611-01-4	Intentional addition / 1,000ppm	chemical products
17566	[N,N'-[2,9H,3,1H-phthalocyaninediylbis(methylene)bis(2-dibutylamino)acetamidato(2-)-N29,N30,N31,N32]copper	85614-41-1	Intentional addition / 1,000ppm	chemical products
17567	Temazolomide	85622-93-1	Contains (regardless of intentional or impurities)	chemical products
17568	Zirconium, tributoxyl(2,4-pentanedionato-O,O')	85626-36-4	Contains (regardless of intentional or impurities)	chemical products
17569	Cuprate(2-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-[4-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]azo]-4-hydroxybenzenesulfonato(4-)]-], sodium	85631-07-8	Intentional addition / 1,000ppm	chemical products
17570	Cuprate(2-), [6-[[7-[[ethenylsulfonyl]methylamino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-5-hydroxy-1-naphthalenesulfonato(4-)]-], potassium	85631-08-9	Intentional addition / 1,000ppm	chemical products
17571	Cuprate(3-), [4-amino-5-hydroxy-6-[[2-hydroxy-4-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]azo]-1,7-naphthalenedisulfonato(5-)]-], sodium	85631-09-0	Intentional addition / 1,000ppm	chemical products
17572	Cuprate(4-), [5-(acetylamino)-4-hydroxy-3-[[5-hydroxy-6-[[2-hydroxy-5-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]azo]-7-sulfo-2-naphthalenyl]azo]-2,7-naphthalenedisulfonato(6-)]-], sodium	85631-10-3	Intentional addition / 1,000ppm	chemical products
17573	Cuprate(5-), [4-amino-3-[[2,5-disulfonyl]azo]-5-hydroxy-6-[[2-hydroxy-5-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(7-)]-], sodium	85631-11-4	Intentional addition / 1,000ppm	chemical products
17574	Fatty acids, C12-22 and C12-22-unsaturated, reaction products with boric acid compound with diethanolamine	85631-32-9	Intentional addition / 1%	chemical products
17575	Amines, rosin, aqua[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-[[2-hydroxybenzoato(2-)]chromate(2-)]	85631-45-4	Contains (regardless of intentional or impurities)	chemical products
17576	Amines, C12-14-tert-alkyl, bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	85631-46-5	Contains (regardless of intentional or impurities)	chemical products
17577	Amines, rosin, bis[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]chromate(3-)(3:1)	85631-47-6	Contains (regardless of intentional or impurities)	chemical products
17578	2-Propanoic acid, gamma-omega-perfluoro-C8-14-alkyl esters	85631-54-5	Intentional addition	chemical products
17579	Trisodium [5-acetamido-4-hydroxy-3-[[2-hydroxy-5-methoxy-4-[[2-[[sulphoxy]ethyl]sulfonyl]phenyl]azo]naphthalene-2,7-disulphonato(5-)]cuprate(3-)	85631-95-4	Intentional addition / 1,000ppm	chemical products
17580	Trisodium [3-[[2,4-dihydroxy-5-[[2-hydroxy-5-[[2-[[sulphoxy]ethyl]sulfonyl]phenyl]azo]naphthalene-1,5-disulphonato(5-)]cuprate(3-)	85631-96-5	Intentional addition / 1,000ppm	chemical products
17581	Cuprate(1-), [C-chloro-2,9H,3,1H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen, compound with (2-)-9-octadecen-1-amine (1:1)	85648-20-0	Intentional addition / 1,000ppm	chemical products
17582	Sodium [1-[[5-(ethylsulphonyl)-2-hydroxyphenyl]azo]-2-naphthalato(2-)]methyl [8-[[5-(ethylsulphonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthyl]methylcarbamato(2-)]cobaltate(1-)	85650-70-0	Intentional addition / 1%	chemical products
17583	Hydrogen [1-[[5-(ethylsulphonyl)-2-hydroxyphenyl]azo]-2-naphthalato(2-)]methyl [8-[[5-(ethylsulphonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthyl]methylcarbamato(2-)]cobaltate(1-)	85650-71-1	Intentional addition / 1%	chemical products
17584	Hydrogen bis[[5-(chloro-2-hydroxyphenyl]azo)-6-hydroxy-N-(2-hydroxyethyl)-N-methylnaphthalene-2-sulphonamidato(2-)]chromate(1-)	85650-72-2	Contains (regardless of intentional or impurities)	chemical products
17585	Sodium bis[[5-(chloro-2-hydroxyphenyl]azo)-6-hydroxy-N-(2-hydroxyethyl)-N-methylnaphthalene-2-sulphonamidato(2-)]chromate(1-)	85650-73-3	Contains (regardless of intentional or impurities)	chemical products
17586	[Hexachloro-2,9H,3,1H-phthalocyaninato-N29,N30,N31,N32]copper	85650-74-4	Intentional addition / 1,000ppm	chemical products
17587	[Nonachloro-2,9H,3,1H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	85650-75-5	Intentional addition / 1,000ppm	chemical products
17588	Hydrogen [dichloro-2,9H,3,1H-phthalocyaninesulphonato(3-)-N29,N30,N31,N32]cuprate(1-), compound with (Z)-octadec-9-enylamine (1:1)	85650-76-6	Intentional addition / 1,000ppm	chemical products
17589	Cuprate(2-), [C-chloro-2,9H,3,1H-phthalocyanine-C-disulphonato(4-)-N29,N30,N31,N32]-, dihydrogen	85650-77-7	Intentional addition / 1,000ppm	chemical products
17590	Dihydrogen [chloro-2,9H,3,1H-phthalocyaninedisulphonato(4-)-N29,N30,N31,N32]cuprate(2-), compound with (Z)-octadec-9-enylamine (1:2)	85650-78-8	Intentional addition / 1,000ppm	chemical products
17591	Cuprate(1-), [2,9H,3,1H-phthalocyanine-C-sulfonato(2-)-N29,N30,N31,N32]-, hydrogen, compound with (Z)-9-octadecen-1-amine (1:1)	85650-96-0	Intentional addition / 1,000ppm	chemical products
17592	Dihydrogen [2,9H,3,1H-phthalocyaninedisulphonato(4-)-N29,N30,N31,N32]cuprate(2-), compound with (Z)-octadec-9-enylamine (1:2)	85650-97-1	Intentional addition / 1,000ppm	chemical products
17593	Tetrasodium [bis[[[2-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]amino]sulfonyl]-2,9H,3,1H-phthalocyaninedisulphonato(6-)-N29,N30,N31,N32]cuprate(4-)]	85650-98-2	Intentional addition / 1,000ppm	chemical products
17594	[Heptachloro-2,9H,3,1H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	85665-46-9	Intentional addition / 1,000ppm	chemical products
17595	Cuprate(2-), [C,C-dichloro-2,9H,3,1H-phthalocyanine-C,C-disulphonato(4-)-N29,N30,N31,N32]-, dihydrogen	85665-47-0	Intentional addition / 1,000ppm	chemical products
17596	Dihydrogen [dichloro-2,9H,3,1H-phthalocyaninedisulphonato(4-)-N29,N30,N31,N32]cuprate(2-), compound with (Z)-octadec-9-enylamine (1:2)	85665-48-1	Intentional addition / 1,000ppm	chemical products
17597	Hydrogen [carbonato(2-)-O](dinonylnaphthalene-1-sulphonato-O)barate(1-)	85665-49-2	Contains (regardless of intentional or impurities)	chemical products
17598	3-Methoxybutyl (Z,Z)-12,12-dibutyl-3-methyl-7,10,14-trioxo-2,6,11,13-tetraoxa-12-stannaheptadeca-8,15-dien-1-ylate	85665-63-0	Contains (regardless of intentional or impurities)	chemical products
17599	Nitric acid, cadmium salt, dodecahydrate	85688-00-2	Contains (regardless of intentional or impurities)	chemical products
17600	(Z)-[3-Methylbenzoato-O]octadec-9-enato-O)barium	85702-49-4	Contains (regardless of intentional or impurities)	chemical products
17601	Dibutylbis[3,5,5-trimethylhexanoxy]stannane	85702-55-2	Contains (regardless of intentional or impurities)	chemical products
17602	2-Hydroxyethyl 4-[[dibutyl[[1-oxododecyl]oxy]stannyl]oxy]-4-oxobut-2-enate	85702-56-3	Contains (regardless of intentional or impurities)	chemical products
17603	1,1,3,3-Tetrabutyl-1,3-bis[[1-oxohexadecyl]oxy]distannoxane	85702-57-4	Contains (regardless of intentional or impurities)	chemical products
17604	(2-Ethylhexanoato-O)(neodecanoato-O)barium	85702-73-4	Contains (regardless of intentional or impurities)	chemical products
17605	Dibutylbis[[1-oxoisooctyl]oxy]stannane	85702-74-5	Contains (regardless of intentional or impurities)	chemical products
17606	Dibutylbis[[1-oxoisooctyl]oxy]stannane	85702-75-6	Contains (regardless of intentional or impurities)	chemical products
17607	1,1,3,3-tetrabutyl-1,3-bis[[1-oxododecyl]oxy]distannoxane	85702-76-7	Contains (regardless of intentional or impurities)	chemical products
17608	1,1,3,3-Tetramethyl-1,3-bis[[1-oxododecyl]oxy]distannoxane	85702-77-8	Contains (regardless of intentional or impurities)	chemical products
17609	Bis(isooctanoxy)diocylstannane	85702-78-9	Contains (regardless of intentional or impurities)	chemical products
17610	Tricholine borate	85702-84-7	Intentional addition / 1%	chemical products
17611	2,2,4,4-Tetrabutyl-7-hydroxy-1,3,5,2,4-trioxadistannone-6,9-dione	85702-85-8	Contains (regardless of intentional or impurities)	chemical products
17612	Dimethylbis(nonanoxy)stannane	85702-86-9	Contains (regardless of intentional or impurities)	chemical products
17613	Diocylbis[3,5,5-trimethylhexanoxy]stannane	85702-87-0	Contains (regardless of intentional or impurities)	chemical products
17614	Bis[[2-hexyl-1-oxododecyl]oxy]diocylstannane	85702-88-1	Contains (regardless of intentional or impurities)	chemical products
17615	[4-(tert-Butyl)benzoato-O](2-ethylhexanoato-O)barium	85711-82-6	Contains (regardless of intentional or impurities)	chemical products
17616	Ethylheptadecafluorooctane	85711-89-3	Intentional addition / 1,000ppm	chemical products
17617	5-[[4-Amino-5-methoxy-2-tyl]azo]saliicylic acid	85720-86-1	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17618	Dihydrogen bis[[4-[[4-(diethylamino)phenyl][4-(ethyl(3-sulphatobenzenyl)amino)phenyl]methylene]cyclohexa-2,5-dien-1-ylidene]ethyl(3-sulphatobenzenyl)ammonium], barium salt	85721-16-0	Contains (regardless of intentional or impurities)	chemical products
17619	Dibarium 6,6'-[[3,3'-dimethoxy-1,1'-biphenyl]-4,4'-diyl]bis(azo)bis[4-amino-5-hydroxynaphthalene-1,3-disulphonate]	85721-17-1	Contains (regardless of intentional or impurities)	chemical products
17620	Bis(n-butylcyclopentadienyl)hafnium dichloride	85722-08-3	Intentional addition / 1%	chemical products
17621	Sodium [4-hydroxy-3-[(5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-yl)azo]benzenesulphonamide S,S-dioxidate(2-)]N-[7-hydroxy-8-[(2-hydroxy-5-nitrophenyl)azo]-1-naphthyl]acetamidate(2-)]chromate(1-)	85737-08-2	Contains (regardless of intentional or impurities)	chemical products
17622	[4-Hydroxy-3-[(2-hydroxy-4-nitrophenyl)azo]naphthalene-1-sulphonato(3-)]chromium	85737-10-6	Intentional addition / 1,000ppm	chemical products
17623	[[3-[[1-(3-Chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulphonato(3-)]]chromium	85737-11-7	Intentional addition / 1,000ppm	chemical products
17624	Hydrogen [3-hydroxy-4-[[1-hydroxy-8-sulpho-2-naphthyl]azo]naphthalene-1-sulphonato(4-)]chromate(1-)	85737-12-8	Contains (regardless of intentional or impurities)	chemical products
17625	Carboxylic acids, C3-8, chromium salts	85737-13-9	Intentional addition / 1,000ppm	chemical products
17626	Carboxylic acids, C3-10, copper(1+) salts, oxidized	85737-14-0	Intentional addition / 1,000ppm	chemical products
17627	Fatty acids, C3-22, cobalt salts, basic	85737-17-3	Intentional addition / 1%	chemical products
17628	Fatty acids, C3-22, copper salts, basic	85737-18-4	Intentional addition / 1,000ppm	chemical products
17629	Fatty acids, C3-22, manganese salts, basic	85737-19-5	Contains (regardless of intentional or impurities)	chemical products
17630	1-Butene, 1-bromo-3-methyl-	85738-96-1	Intentional addition / 1,000ppm	chemical products
17631	Cuprate(3-), [2-[[[3-[[4-[[2-[(2-chloroethyl)sulfonyl]ethyl]amino]-6-fluoro-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulphophenyl]azophenyl]methyl]azo]-4-sulphobenzoato(5-)]-, trihydrogen	85745-52-4	Intentional addition / 1,000ppm	chemical products
17632	5-Methoxy-4-(morpholin-4-yl)-2-[[p-tolylthio]benzenediazonium tetrafluoroborate	85750-32-9	Intentional addition / 1%	chemical products
17633	Trisodium [[[(3-[[4-chloro-6-(2-sulphoanilino)-1,3,5-triazin-2-yl]amino]phenyl]amino)sulphonyl]-29H,31H-phthalocyaninedisulphonato(5-)-N29,N30,N31,N32]cuprate(3-)]	85763-60-6	Intentional addition / 1,000ppm	chemical products
17634	Disodium [[[(3-[[4-chloro-6-(2-sulphoanilino)-1,3,5-triazin-2-yl]amino]phenyl]amino)sulphonyl]sulphamoyl]-29H,31H-phthalocyaninesulphonato(4-)-N29,N30,N31,N32]cuprate(2-)]	85763-61-7	Intentional addition / 1,000ppm	chemical products
17635	Chromium, naphthenate propionate complexes	85763-68-4	Intentional addition / 1,000ppm	chemical products
17636	Manganese, C3-13-carboxylate pentyl phosphate complexes	85763-71-9	Contains (regardless of intentional or impurities)	chemical products
17637	Manganese, naphthenate neodecanate pentyl phosphate complexes	85763-72-0	Contains (regardless of intentional or impurities)	chemical products
17638	Vanadium, neodecanoate oxo pentyl phosphate complexes	85763-73-1	Intentional addition / 1%	chemical products
17639	Zirconium, acetate 2-ethylhexanoate oxo complexes	85763-76-4	Contains (regardless of intentional or impurities)	chemical products
17640	Zirconium, acetate neodecanoate oxo complexes	85763-77-5	Contains (regardless of intentional or impurities)	chemical products
17641	Molybdenum, (benzoyl-C,O)dicarbonyl[tris(3,5-dimethyl-1H-pyrazolato-N1)hydroborato(1-)-N2,N2',N2'']-	85826-55-7	Intentional addition / 1,000ppm	chemical products
17642	Chromate(2-), [2-[[3-chloro-2-hydroxy-5-nitrophenyl]azo]-4-methyl-1-naphthalenolato(2-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulphonato(3-)]-, sodium	85828-73-5	Contains (regardless of intentional or impurities)	chemical products
17643	Chromate(2-), [4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulphonato(3-)]1-[[2-hydroxy-5-[[2-methoxyphenyl]azo]phenyl]azo]-2-naphthalenolato(2-)]-, lithium sodium	85828-74-6	Contains (regardless of intentional or impurities)	chemical products
17644	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulphonato(3-)]N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]acetamidate(2-)]-, lithium sodium	85828-75-7	Contains (regardless of intentional or impurities)	chemical products
17645	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulphonato(3-)]1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-, lithium sodium	85828-76-8	Contains (regardless of intentional or impurities)	chemical products
17646	Chromate(2-), bis[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-N,N-dimethylbenzenesulphonamidate(2-)]-, lithium sodium	85828-85-9	Contains (regardless of intentional or impurities)	chemical products
17647	Chromate(2-), [5-chloro-2-hydroxy-3-[[5-hydroxynaphth[2,1-d]-1,3-oxathiol-4-yl]azo]benzenesulfonic acid S,S-dioxidate(3-)]1-[[4,5-dichlorophenyl]azo]-2-[[2-hydroxy-5-nitrophenyl]imino]methyl]phenolato(2-)]-, lithium sodium	85828-86-0	Contains (regardless of intentional or impurities)	chemical products
17648	Chromium, 5-chloro-2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonate 4-[[2-chloro-4-nitrophenyl]azo]-2-[[2-hydroxy-5-nitrophenyl]imino]methyl]phenol lithium sodium complexes	85828-87-1	Intentional addition / 1,000ppm	chemical products
17649	Chromium, 3-[[[5-[[2-chloro-4-nitrophenyl]azo]-2-hydroxyphenyl]methylene]amino]-4-hydroxybenzenesulfonamide 2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-sulfobenzoate lithium sodium complexes	85828-88-2	Intentional addition / 1,000ppm	chemical products
17650	Chromium, 4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamide N-[7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl]acetamide lithium sodium complexes	85828-90-6	Intentional addition / 1,000ppm	chemical products
17651	Cobalt, 2-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamide 3-[[1-(2-benzothiazolyl)-2-oxopropyl]azo]-4-hydroxybenzenesulfonamide lithium sodium complexes	85828-91-7	Intentional addition / 1%	chemical products
17652	Cobaltate(1-), bis[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-methylbenzenesulfonamidate(2-)]-, lithium sodium	85828-92-8	Intentional addition / 1%	chemical products
17653	Trimethoxy(3,3,4,4,5,5,6,6,7,7,8,8,8-tridecafluorooctyl)silane	85857-16-5	Contains (regardless of intentional or impurities)	chemical products
17654	Chromate(2-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]1-[[2-(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-5-sulfobenzoato(3-)]-, lithium sodium	85865-79-8	Contains (regardless of intentional or impurities)	chemical products
17655	Chromate(1-), [N-[8-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-2-naphthalenyl]acetamidate(2-)]1-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidate(2-)]-, hydrogen	85865-83-4	Contains (regardless of intentional or impurities)	chemical products
17656	[Methyl 3-[[3-[[2,5-dichloroanilino]carbonyl]-2-hydroxy-1-naphthyl]methylene]amino]-4-hydroxybenzoato(2-)]copper	85865-84-5	Intentional addition / 1,000ppm	chemical products
17657	Hydrogen [4-[[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxynaphthalene-1-sulphonato(3-)]cuprate(1-)	85865-85-6	Intentional addition / 1,000ppm	chemical products
17658	Hydrogen [3-[[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulphonato(3-)]cuprate(1-)	85865-86-7	Intentional addition / 1,000ppm	chemical products
17659	Hydrogen [3-[[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulphonato(3-)]chromate(1-)	85865-87-8	Contains (regardless of intentional or impurities)	chemical products
17660	Chromate(3-), [4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulphonato(3-)]3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulphonato(3-)]-, sodium dihydrogen	85865-88-9	Contains (regardless of intentional or impurities)	chemical products
17661	Sodium hydrogen [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]1-[[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]]chromate(2-)]	85865-89-0	Contains (regardless of intentional or impurities)	chemical products
17662	Hydrogen [3-[[1-(anilino)carbonyl]-2-oxopropyl]azo]-4-hydroxybenzenesulphonato(3-)]cuprate(1-)	85883-84-7	Intentional addition / 1,000ppm	chemical products
17663	Chromium, 3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamide 4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonamide cobalt complexes	85895-65-4	Intentional addition / 1,000ppm	chemical products
17664	Bis(2,3-dihydroxypropyl)dodecylammonium perchlorate	85896-19-1	Intentional addition / 1,000ppm	chemical products
17665	Trisodium [3-hydroxy-4-[[2-hydroxy-5-sulphophenyl]azo]naphthalene-2,7-disulphonato(5-)]chromate(3-)	85896-33-9	Contains (regardless of intentional or impurities)	chemical products
17666	Trihydrogen [3-hydroxy-4-[[2-hydroxy-5-sulphophenyl]azo]naphthalene-2,7-disulphonato(5-)]chromate(3-)	85896-34-0	Contains (regardless of intentional or impurities)	chemical products
17667	Sodium [3-[[1-[[2-chloroanilino]carbonyl]-2-oxopropyl]azo]-4-hydroxy-5-nitrobenzene-1-sulphonato(3-)]chromate(1-)	85896-35-1	Contains (regardless of intentional or impurities)	chemical products
17668	Hydrogen [3-[[1-[[2-chloroanilino]carbonyl]-2-oxopropyl]azo]-4-hydroxy-5-nitrobenzene-1-sulphonato(3-)]chromate(1-)	85896-36-2	Contains (regardless of intentional or impurities)	chemical products
17669	Disodium [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulphophenyl)-1H-pyrazol-4-yl]azo]-2-hydroxybenzene-1-sulphonato(4-)]chromate(2-)]	85896-37-3	Contains (regardless of intentional or impurities)	chemical products
17670	Dihydrogen [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulphophenyl)-1H-pyrazol-4-yl]azo]-2-hydroxybenzene-1-sulphonato(4-)]chromate(2-)]	85896-38-4	Contains (regardless of intentional or impurities)	chemical products
17671	Hydrogen [5-[[1-(anilino)carbonyl]-2-oxopropyl]azo]-3-chloro-4-hydroxybenzene-1-sulphonato(3-)]chromate(1-)	85896-39-5	Contains (regardless of intentional or impurities)	chemical products
17672	Disodium [[4-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulphophenyl)-1H-pyrazol-4-yl]azo]-3-hydroxynaphthalene-1-sulphonato(4-)]]chromate(2-)]	85896-40-6	Contains (regardless of intentional or impurities)	chemical products
17673	Dihydrogen [5-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzene-1,3-disulphonato(4-)]chromate(2-)]	85896-41-9	Contains (regardless of intentional or impurities)	chemical products
17674	Disodium [5-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzene-1,3-disulphonato(4-)]chromate(2-)]	85896-42-0	Contains (regardless of intentional or impurities)	chemical products
17675	Disodium [2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulpho-o-tolyl)-1H-pyrazol-4-yl]azo]-4-sulphobenzoato(4-)]chromate(2-)]	85896-43-1	Contains (regardless of intentional or impurities)	chemical products
17676	Dihydrogen [2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulpho-o-tolyl)-1H-pyrazol-4-yl]azo]-4-sulphobenzoato(4-)]chromate(2-)]	85896-44-2	Contains (regardless of intentional or impurities)	chemical products
17677	Dihydrogen [4-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulphophenyl)-1H-pyrazol-4-yl]azo]-3-hydroxynaphthalene-1-sulphonato(4-)]chromate(2-)]	85896-45-3	Contains (regardless of intentional or impurities)	chemical products
17678	Sodium [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxybenzene-1-sulphonato(3-)]chromate(1-)]	85896-46-4	Contains (regardless of intentional or impurities)	chemical products
17679	[1-[[2-Hydroxy-4-nitrophenyl]azo]-2-naphtholato(2-)]chromium	85896-47-5	Intentional addition / 1,000ppm	chemical products
17680	Sodium [5-chloro-2-hydroxy-3-[[1,2,3,4-tetrahydro-2,4-dioxoquinolin-3-yl]azo]benzene-1-sulphonato(3-)]chromate(1-)]	85896-48-6	Contains (regardless of intentional or impurities)	chemical products
17681	Hydrogen [5-chloro-2-hydroxy-3-[[1,2,3,4-tetrahydro-2,4-dioxoquinolin-3-yl]azo]benzene-1-sulphonato(3-)]chromate(1-)]	85896-49-7	Contains (regardless of intentional or impurities)	chemical products
17682	Isopropyl (Z,Z)-2-methyl-9,9-dioctyl-4,7,11-trioxo-3,8,10-trioxo-9-stannatetradeca-5,12-dien-14-oste	85938-40-5	Contains (regardless of intentional or impurities)	chemical products
17683	Bis(myrstioxyloxy)diocystannane	85938-41-6	Contains (regardless of intentional or impurities)	chemical products
17684	Diocetylbis(palmitoxyloxy)stannane	85938-42-7	Contains (regardless of intentional or impurities)	chemical products
17685	Bis(nonanoyloxy)diocystannane	85938-43-8	Contains (regardless of intentional or impurities)	chemical products
17686	(9Z,12Z,15Z)-1,3-Bis(octadeca-9,12,15-trienyloxy)-1,1,3,3-tetraoctyldistannoxane	85938-44-9	Contains (regardless of intentional or impurities)	chemical products
17687	(9Z,12Z)-1,3-Bis(octadeca-9,12-dienyloxy)-1,1,3,3-tetraoctyldistannoxane	85938-45-0	Contains (regardless of intentional or impurities)	chemical products
17688	(Z,Z)-1,1,3,3-tetraoctyl-1,3-bis(1-oxooctadec-9-enyloxy)distannoxane	85938-46-1	Contains (regardless of intentional or impurities)	chemical products
17689	1,1,3,3-tetraoctyl-1,3-bis(1-oxohexadecyloxy)distannoxane	85938-47-2	Contains (regardless of intentional or impurities)	chemical products
17690	Dibutylfluorophenylstannane	85938-48-3	Contains (regardless of intentional or impurities)	chemical products
17691	Dibutylfluorohexylstannane	85938-49-4	Contains (regardless of intentional or impurities)	chemical products
17692	2-Ethylhexyl [[2-butyl-4,7-dihydro-4,7-dioxo-1,3,2-dioxastannepin-2-yl]thio]acetate	85938-50-7	Contains (regardless of intentional or impurities)	chemical products
17693	Tributyl[[p-dodecylphenyl]sulphonyloxy]stannane	85938-51-8	Contains (regardless of intentional or impurities)	chemical products
17694	Sodium tributylstannolate	85938-52-9	Contains (regardless of intentional or impurities)	chemical products
17695	Bis(octadeca-9(Z),12(Z)-dienyloxy)diocystannane	85938-53-0	Contains (regardless of intentional or impurities)	chemical products
17696	Chromate(5-), bis[4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulphophenyl]azo]-6-(phenylamino)-2-naphthalenesulphonato(4-)]-, potassium sodium	85940-15-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17697	Phosphorodithioic acid, mixed O,O-bis(2-ethylhexyl and isobutyl and isopropyl) esters, zinc salts	85940-28-9	Intentional addition / 1,000ppm	chemical products
17698	Iron molybdenum oxide (Fe2MoO21)	85941-74-8	Intentional addition / 1,000ppm	chemical products
17699	Dihydrogen [4-hydroxy-3-[[[2-hydroxy-1-naphthyl]azo]-N-phenyl]benzenesulfonamidato(2-)]-2-[[[4-hydroxy-3-(2-hydroxy-1-naphthyl)azo]phenyl]sulfonyl]amino]benzoato(3-)]cobaltate(2-)	85958-76-5	Intentional addition / 1%	chemical products
17700	Sodium [5-[[[1-(aminocarbonyl)-2-oxopropyl]azo]-3-chloro-4-hydroxybenzene-1-sulphonato(3-)]chromate(1-)]	85958-77-6	Contains (regardless of intentional or impurities)	chemical products
17701	Trisodium bis[5-[[[4-hydroxy-3-[[[2-oxo-1-[[[phenylamino]carbonyl]propyl]azo]phenyl]sulphonyl]amino]naphthalene-2-sulphonato(3-)]cobaltate(3-)]	85958-78-7	Intentional addition / 1%	chemical products
17702	[5-[[[2,4-Dihydroxyphenyl]azo]-2-hydroxy-3-sulphobenzato(3-)-O1,O2]chromium	85958-79-8	Intentional addition / 1,000ppm	chemical products
17703	Nickel [2-hydroxybenzoic acid [3-(1-cyano-2-(methylamino)-2-oxoethylidene)-2,3-dihydro-1H-isindol-1-ylidene]hydrazidato(2-)]-	85958-80-1	Contains (regardless of intentional or impurities)	chemical products
17704	Chromate(1-), [7-[[[5-chloro-2-hydroxyphenyl]azo]-8-hydroxy-1,6-naphthalenedisulfonato(4-)]-], sodium	85958-81-2	Contains (regardless of intentional or impurities)	chemical products
17705	Sodium [5-chloro-2-hydroxy-3-[[[2-hydroxy-5-[[[4-sulphophenyl]azo]phenyl]methylene]amino]benzene-1-sulphonato(4-)]chromate(1-)]	85958-82-3	Contains (regardless of intentional or impurities)	chemical products
17706	Sodium [3-[[[5-[[[2-chloro-5-sulphophenyl]azo]-2-hydroxyphenyl]methylene]amino]-2-hydroxy-5-nitrobenzene-1-sulphonato(4-)]chromate(1-)]	85958-83-4	Contains (regardless of intentional or impurities)	chemical products
17707	Potassium [3-[[[5-[[[2-chloro-5-sulphophenyl]azo]-2-hydroxyphenyl]methylene]amino]-2-hydroxy-5-nitrobenzene-1-sulphonato(4-)]chromate(1-)]	85958-84-5	Contains (regardless of intentional or impurities)	chemical products
17708	Chromate(1-), [3-[[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulphophenyl)-1H-pyrazol-4-yl]methylene]amino]-2-hydroxy-5-nitrobenzenesulfonato(4-)]-], sodium	85958-85-6	Contains (regardless of intentional or impurities)	chemical products
17709	Bis(5-oxo-L-prolinate-N1,O2)cadmium	85958-86-7	Contains (regardless of intentional or impurities)	chemical products
17710	Bis(5-oxo-L-prolinate-N1,O2)tin	85958-87-8	Contains (regardless of intentional or impurities)	chemical products
17711	Trisodium [[[[3-[[[4-chloro-6-[[N-(sulphomethyl)amino]-1,3,5-triazin-2-yl]amino]phenyl]amino]sulphonyl]-2,9H,31H-phthalocyaninedisulfonato(5-)-N29,N30,N31,N32]cuprate(3-)]	85958-88-9	Intentional addition / 1,000ppm	chemical products
17712	Trisodium [[[[3-[[[4-chloro-6-[[phenyl]sulphomethyl]amino]-1,3,5-triazin-2-yl]amino]phenyl]amino]sulphonyl]sulphamoyl]-2,9H,31H-phthalocyaninedisulfonato(5-)-N29,N30,N31,N32]cuprate(3-)]	85958-89-0	Intentional addition / 1,000ppm	chemical products
17713	Disodium [3-hydroxy-4-[[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]-1-[[[2-hydroxy-4-(or5)-nitrophenyl]azo]-2-naphtholato(2-)]chromate(2-)]	85958-90-3	Contains (regardless of intentional or impurities)	chemical products
17714	Barium bis(5-oxo-DL-prolinate)	85959-43-9	Contains (regardless of intentional or impurities)	chemical products
17715	Barium bis(5-oxo-L-prolinate)	85959-44-0	Contains (regardless of intentional or impurities)	chemical products
17716	Ferrate(2-), [N,N-bis[2-bis(carboxymethyl)amino]ethyl]glycinato(5-)]-, diammonium, (PB-7-13-12564)-	85959-68-8	Intentional addition / 1%	chemical products
17717	Cuprate(1-), [3-[[[3-[[[4-[[[2-amino-4-hydroxyphenyl]azo]phenyl]amino]carbonyl]phenyl]azo]-2,4-dihydroxyphenyl]azo]-4-hydroxybenzenesulfonato(3-)]-], sodium	85959-71-3	Intentional addition / 1,000ppm	chemical products
17718	Dihydrogen bis[2-chloro-4-[[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-hydroxybenzenesulfonamidato(2-)]chromate(1-)]	85959-72-4	Contains (regardless of intentional or impurities)	chemical products
17719	Cobaltate(3-), bis[2-hydroxy-5-nitro-3-[[[2-oxo-1-[[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-], trisodium	85959-73-5	Intentional addition / 1,000ppm	chemical products
17720	Chromate(1-), [N-[8-[[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]acetamidato(2-)]-][3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamidato(2-)]-, hydrogen	85959-74-6	Contains (regardless of intentional or impurities)	chemical products
17721	Cobaltate(1-), bis[3-[[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-N-methylbenzenesulfonamidato(2-)]-], hydrogen	85959-75-7	Intentional addition / 1%	chemical products
17722	Chromate(3-), [4-[[[4,5-dihydro-4-[[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-][3-hydroxy-4-[[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-], trisodium	85959-76-8	Contains (regardless of intentional or impurities)	chemical products
17723	Tetrakis(5-oxo-L-prolinate-N1,O2)tin	85959-77-9	Contains (regardless of intentional or impurities)	chemical products
17724	Bis(5-oxo-DL-prolinate-N1,O2)cobalt	85959-78-0	Intentional addition / 1%	chemical products
17725	Sodium [6-amino-5-[[[2-hydroxy-4-nitrophenyl]azo]naphthalene-1-sulphonato(3-)]chromate(1-)]	85959-79-1	Contains (regardless of intentional or impurities)	chemical products
17726	Dihydrogen bis[2-[[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-[[[methylamino]sulphonyl]benzoato(2-)]chromate(1-)]	85959-80-4	Contains (regardless of intentional or impurities)	chemical products
17727	Bis(pentamethylcyclopentadienyl)hafnium(IV) dichloride	85959-83-7	Intentional addition / 1%	chemical products
17728	Chromate(3-), bis[2-[[[2,7-dihydroxy(5-sulfo-1-naphthalenyl)azo]phenyl]azo]benzoato(3-)]-, trisodium	85959-84-8	Contains (regardless of intentional or impurities)	chemical products
17729	Cuprate(4-), [mu-[[4-hydroxy-7-[[[5-hydroxy-6-[[[2-hydroxy-3-nitro-5-sulphonyl]azo]-2-naphthalenyl]amino]-3-[[[2-hydroxy-5-nitro-3-sulphonyl]azo]-2-naphthalenesulfonato(8-)]-]]di-, tetrasodium	85977-50-0	Intentional addition / 1,000ppm	chemical products
17730	(S)-Bis(lactato-O1,O2)iron	85993-25-5	Intentional addition / 1%	chemical products
17731	Bis(5-oxo-DL-prolinate-N1,O2)cadmium	85994-31-6	Contains (regardless of intentional or impurities)	chemical products
17732	Tris(5-oxo-L-prolinate-N1,O2)iron	85994-36-1	Intentional addition / 1%	chemical products
17733	Bis(5-oxo-L-prolinate-N1,O2)cobalt	85994-37-2	Intentional addition / 1%	chemical products
17734	Sulfuric acid, chromium sodium salt, basic	86014-63-3	Intentional addition / 1,000ppm	chemical products
17735	Chromium, formate sulfate sodium complexes, basic	86014-66-6	Intentional addition / 1,000ppm	chemical products
17736	Cuprate(2-), [7-amino-4-hydroxy-3-[[[2-hydroxy-4-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2-naphthalenesulfonato(4-)]-], potassium sodium	86014-67-7	Intentional addition / 1,000ppm	chemical products
17737	Cuprate(2-), [4-hydroxy-3-[[[2-hydroxy-4-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-1-naphthalenesulfonato(4-)]-], sodium	86014-68-8	Intentional addition / 1,000ppm	chemical products
17738	Cuprate(3-), [5-(acetylamino)-4-hydroxy-3-[[[2-hydroxy-5-methoxy-4-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(5-)]-], potassium sodium	86014-69-9	Intentional addition / 1,000ppm	chemical products
17739	Cuprate(3-), [4-amino-5-hydroxy-6-[[[2-hydroxy-5-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-1,3-naphthalenedisulfonato(5-)]-], potassium sodium	86014-70-2	Intentional addition / 1,000ppm	chemical products
17740	Cuprate(3-), [4,5-dihydro-4-[[[2-hydroxy-4-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-5-oxo-1-(4-sulphophenyl)-1H-pyrazole-3-carboxylato(5-)]-], sodium	86014-71-3	Intentional addition / 1,000ppm	chemical products
17741	Cuprate(3-), [3-[[[2,4-dihydroxy-3-[[[2-hydroxy-5-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]phenyl]azo]-1,5-naphthalenedisulfonato(5-)]-], sodium	86014-72-4	Intentional addition / 1,000ppm	chemical products
17742	Cuprate(4-), [5-(acetylamino)-4-hydroxy-3-[[[1-hydroxy-6-sulfo-8-[[[2-(sulfoxy)ethyl]sulfonyl]-2-naphthalenyl]azo]-2,7-naphthalenedisulfonato(6-)]-], sodium	86014-73-5	Intentional addition / 1,000ppm	chemical products
17743	Cuprate(4-), [4-amino-5-hydroxy-6-[[[2-hydroxy-4-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-3-[[[4-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(6-)]-], potassium sodium	86014-74-6	Intentional addition / 1,000ppm	chemical products
17744	Cuprate(4-), [4-amino-5-hydroxy-6-[[[2-hydroxy-5-sulphonyl]azo]-3-[[[4-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(6-)]-], potassium sodium	86014-75-7	Intentional addition / 1,000ppm	chemical products
17745	Iron, complexes with diazotized 2-amino-4,6-dinitrophenol coupled with diazotized 4-nitrobenzenamine and 4-[[[2,4-dihydroxyphenyl]azo]-5-hydroxy-2,7-naphthalenedisulfonic acid, sodium salts	86014-76-8	Intentional addition / 1%	chemical products
17746	Bis(5-oxo-DL-prolinate-N1,O2)tin	86022-43-7	Contains (regardless of intentional or impurities)	chemical products
17747	Trisodium hydrogen [2-[[[alpha-[[[3-[[[4-chloro-6-[[[ethyl]4-[[[2-(sulphoxy)ethyl]sulphonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulphophenyl]azo]benzyl]azo]-4-sulphobenzato(6-)]-]]cuprate(4-)]	86024-59-1	Intentional addition / 1,000ppm	chemical products
17748	Cuprate(4-), [2-[[[3-[[[4-chloro-6-[[[ethyl]4-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulphonyl]azo]phenyl]methyl]azo]-4-sulphobenzato(6-)]-], trisodium hydrogen	86024-60-4	Intentional addition / 1,000ppm	chemical products
17749	2,3,4,4',6'-Pentabromobiphenyl	86029-64-3	Intentional addition / 1,000ppm	chemical products
17750	Strychnidin-10-one, mono[[1R-(1.alpha.,2.beta.,3.alpha.)]-3-methyl-2-(nitromethyl)-5-oxocyclopentaneacetate]	86087-04-9	Contains (regardless of intentional or impurities)	chemical products
17751	Molybdenum sulfide (MoS2), roasted	86089-09-0	Intentional addition / 1,000ppm	chemical products
17752	Cuprate(2-), [2,9H,31H-phthalocyaninedisulfonato(4-)-N29,N30,N31,N32]-, ammonium	86101-71-5	Intentional addition / 1,000ppm	chemical products
17753	Cuprate(2-), [2,9H,31H-phthalocyaninedisulfonato(4-)-N29,N30,N31,N32]-, compounds with ethanolamine	86101-72-6	Intentional addition / 1,000ppm	chemical products
17754	Cuprate(2-), [2,9H,31H-phthalocyaninedisulfonato(4-)-N29,N30,N31,N32]-, compounds with 2-(methylamino)ethanol	86101-73-7	Intentional addition / 1,000ppm	chemical products
17755	Cuprate(2-), [2,9H,31H-phthalocyaninedisulfonato(4-)-N29,N30,N31,N32]-, compounds with piperazine	86101-74-8	Intentional addition / 1,000ppm	chemical products
17756	Cuprate(3-), [2,9H,31H-phthalocyaninetrifluorosulfonato(5-)-N29,N30,N31,N32]-, ammonium	86101-75-9	Intentional addition / 1,000ppm	chemical products
17757	Cuprate(3-), [2,9H,31H-phthalocyaninetrifluorosulfonato(5-)-N29,N30,N31,N32]-, compounds with ethanolamine	86101-76-0	Intentional addition / 1,000ppm	chemical products
17758	Cuprate(3-), [2,9H,31H-phthalocyaninetrifluorosulfonato(5-)-N29,N30,N31,N32]-, compounds with 2-(methylamino)ethanol	86101-77-1	Intentional addition / 1,000ppm	chemical products
17759	Heptane, 3-bromo-3-ethyl-	86119-63-3	Intentional addition / 1,000ppm	chemical products
17760	Dodecane, 1-bromo-3-methyl-	86234-09-5	Intentional addition / 1,000ppm	chemical products
17761	Dodecane, 1-bromo-4-methyl-	86234-10-8	Intentional addition / 1,000ppm	chemical products
17762	Dodecane, 1-bromo-5-methyl-	86234-11-9	Intentional addition / 1,000ppm	chemical products
17763	Dodecane, 1-bromo-6-methyl-	86234-12-0	Intentional addition / 1,000ppm	chemical products
17764	Dodecane, 1-bromo-7-methyl-	86234-13-1	Intentional addition / 1,000ppm	chemical products
17765	Dodecane, 1-bromo-8-methyl-	86234-14-2	Intentional addition / 1,000ppm	chemical products
17766	Dodecane, 1-bromo-9-methyl-	86234-15-3	Intentional addition / 1,000ppm	chemical products
17767	Dodecane, 1-bromo-10-methyl-	86234-16-4	Intentional addition / 1,000ppm	chemical products
17768	Cuprate(4-), diammine[mu-[[7-(benzoylamino)-3-[[[3,3'-dihydroxy-4'-[[[1-hydroxy-4,8-disulfo-2-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(8-)]-]]di-, tetrasodium	86242-87-7	Intentional addition / 1,000ppm	chemical products
17769	Cuprate(4-), bis(2-aminoethanol-N,O)[mu-[[7-(benzoylamino)-3-[[[3,3'-dihydroxy-4'-[[[1-hydroxy-4,8-disulfo-2-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(8-)]-]]di-, tetrasodium	86242-88-8	Intentional addition / 1,000ppm	chemical products
17770	Chromate(1-), bis[N-[8-[[[4-chloro-2-hydroxy-5-methoxyphenyl]azo]-7-hydroxy-1-naphthalenyl]methanesulfonamidato(2-)]-], sodium	86242-89-9	Contains (regardless of intentional or impurities)	chemical products
17771	Chromate(1-), bis[4-(aminosulfonyl)-2-[[[1-[[[2-methylphenyl]amino]carbonyl]-2-oxopropyl]azo]benzoato(2-)]-], sodium	86242-90-2	Contains (regardless of intentional or impurities)	chemical products
17772	Cuprate(4-), ammineaqua[mu-[[7-(benzoylamino)-3-[[[3,3'-dihydroxy-4'-[[[1-hydroxy-4,8-disulfo-2-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(8-)]-]]di-, tetrasodium	86242-91-3	Intentional addition / 1,000ppm	chemical products
17773	Cuprate(4-), (2-aminoethanol-N,O)aqua[mu-[[7-(benzoylamino)-3-[[[3,3'-dihydroxy-4'-[[[1-hydroxy-4,8-disulfo-2-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(8-)]-]]di-, tetrasodium	86242-92-4	Intentional addition / 1,000ppm	chemical products
17774	[5,5'-Azobis(2,6-diisopropylpyrimidinetrionato(2-))]nickel	86249-83-4	Contains (regardless of intentional or impurities)	chemical products
17775	Chromate(1-), [4-(aminosulfonyl)-2-[[[1-[[[2-methylphenyl]amino]carbonyl]-2-oxopropyl]azo]benzoato(2-)]-][N-[8-[[[4-chloro-2-hydroxy-5-methoxyphenyl]azo]-7-hydroxy-1-naphthalenyl]methanesulfonamidato(2-)]-], sodium	86262-20-6	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17776	Cuprate(4-), (2-aminoethanol-N,O)amine[μ-7-[(benzoylamino)-3-[[3,3'-dihydroxy-4'-[(1-hydroxy-4,8-disulfo-2-naphthalenyl)azo]1,1'-biphenyl]-4-y]azo]-4-hydroxy-1,5-naphthalenedisulfonato(8-)]di-, tetrasodium	86262-21-7	Intentional addition / 1,000ppm	chemical products
17777	Gasoline	86290-81-5	Contains (regardless of intentional or impurities)	chemical products
17778	Strychnidin-10-one, mono(-)-phenyl(triethylsilyl)methyl 1,2-benzenedicarboxylate]	86393-05-7	Contains (regardless of intentional or impurities)	chemical products
17779	Strychnidin-10-one, mono(+)-phenyl(triethylsilyl)methyl 1,2-benzenedicarboxylate]	86393-07-9	Contains (regardless of intentional or impurities)	chemical products
17780	(4R)-4-[(2R,3S)-3-[(1R)-1-(tert-butyl)dimethylsilyloxy]ethyl]-4-oxo-2-azetidinyl]-2-diazo-3-oxo valeric acid p-nitrobenzyl	86400-16-0	Intentional addition / 1%	chemical products
17781	Nonane, 4-(2,2-trichloroethyl)-	86405-89-2	Intentional addition / 1,000ppm	chemical products
17782	Hexasodium [μ-[[5,5'-[[3,3'-dihydroxy-1,1'-biphenyl]-4,4'-diyl]bis[azo(8-hydroxy-3,6-disulfo-7,1-naphthalene)imino]6-(3-methylamino)-1,3,5-triazine-4,2-diy]imino]bis[salicylate](10-)]dicuprate(6-)	86437-45-8	Intentional addition / 1,000ppm	chemical products
17783	C.I. Reactive Brown 43	86437-46-9	Contains (regardless of intentional or impurities)	chemical products
17784	Trisodium [4-[[4'-[[7-anilino-1-hydroxy-3-sulpho-2-naphthyl]azo]-3-hydroxy-3-methoxy[1,1'-biphenyl]-4-y]azo]-3-hydroxynaphthalene-2,7-disulphonato(5-)]cuprate(3-)	86437-48-1	Intentional addition / 1,000ppm	chemical products
17785	Trisodium [μ-[[4'-[[7-anilino-1-hydroxy-3-sulpho-2-naphthyl]azo]-3'-dihydroxy[1,1'-biphenyl]-4-y]azo]-3-hydroxynaphthalene-2,7-disulphonato(3-)]cuprate(3-)	86437-49-2	Intentional addition / 1,000ppm	chemical products
17786	Cuprate(6-), [[3'-[[3-hydroxy-3'-methoxy[1,1'-biphenyl]-4,4'-diyl]bis[azo(8-hydroxy-3,6-disulfo-7,1-naphthalenediyl)imino]6-(3-methylphenyl)amino]-1,3,5-triazine-4,2-diy]imino]bis(6-hydroxybenzoato)](8-)]-, hexasodium	86457-81-0	Intentional addition / 1,000ppm	chemical products
17787	Cuprate(3-), [2-[[[3-[(4-amino-6-chloro-1,3,5-triazin-2-yl)amino]-2-hydroxy-5-sulphophenyl]azophenylmethyl]azo]-4-sulfobenzoato(5-)]-, disodium hydrogen	86457-82-1	Intentional addition / 1,000ppm	chemical products
17788	Cuprate(6-), [μ-[[2,2'-[[6-chloro-1,3,5-triazine-2,4-diy]bis(imino)(2-hydroxy-5-sulfo-3,1-phenylene)azo]phenylmethylene]azo]bis(4-sulfobenzoato)](10-)]di-, tetrasodium dihydrogen	86457-83-2	Intentional addition / 1,000ppm	chemical products
17789	Trisodium [4-[[4'-[[7-anilino-1-hydroxy-3-sulpho-2-naphthyl]azo]-3'-hydroxy-3-methoxy[1,1'-biphenyl]-4-y]azo]-3-hydroxynaphthalene-2,7-disulphonato(5-)]cuprate(3-)	86457-84-3	Intentional addition / 1,000ppm	chemical products
17790	Perfluoro compounds, C5-18	86508-42-1	Intentional addition / 1,000ppm	chemical products
17791	1-Hexene, 6-bromo-5-methyl-	86549-16-8	Intentional addition / 1,000ppm	chemical products
17792	1-Hexene, 6-bromo-4-methyl-	86549-17-9	Intentional addition / 1,000ppm	chemical products
17793	1-Hexene, 6-bromo-4,4-dimethyl-	86549-18-0	Intentional addition / 1,000ppm	chemical products
17794	1-Hexene, 6-bromo-3,3-dimethyl-	86549-19-1	Intentional addition / 1,000ppm	chemical products
17795	alpha-Cyano-4-fluoro-3-phenoxybenzyl [1.alpha.(S*),3.alpha.]-(±)-3-(2,2-dichlorovinyl)-2,2-dimethylcyclopropanecarboxylate	86560-93-2	Intentional addition	chemical products
17796	alpha-Cyano-4-fluoro-3-phenoxybenzyl [1.alpha.(R*),3.beta.]-(±)-3-(2,2-dichlorovinyl)-2,2-dimethylcyclopropanecarboxylate	86560-94-3	Intentional addition	chemical products
17797	alpha-Cyano-4-fluoro-3-phenoxybenzyl [1.alpha.(S*),3.beta.]-(±)-3-(2,2-dichlorovinyl)-2,2-dimethylcyclopropanecarboxylate	86560-95-4	Intentional addition	chemical products
17798	Cobalt, resinata sova fatty acids complexes	86687-17-8	Intentional addition / 1%	chemical products
17799	4-(trans-Pentylcyclohexyl)chlorobenzene	86778-48-5	Intentional addition / 1,000ppm	chemical products
17800	2-Octene, 2-bromo-, (E)-	86789-75-5	Intentional addition / 1,000ppm	chemical products
17801	2-Octene, 2-bromo-, (Z)-	86789-77-7	Intentional addition / 1,000ppm	chemical products
17802	2-Nitro-5-(1-piperazinyl)benzaldehyde hydrochloride	86813-46-9	Contains (regardless of intentional or impurities)	chemical products
17803	Acetic acid, mercapto-, 2-ethoxyethyl ester, antimony(3+) salt	86831-40-5	Contains (regardless of intentional or impurities)	chemical products
17804	Bis(2,3-epoxypropyl)disulfide	86840-27-9	Intentional addition / 1%	chemical products
17805	Americium-241	86954-36-1	Intentional addition	chemical products
17806	Cuprate(4-), [4,5-dihydro-4-[2-[8-(hydroxy-kappa O)-7-[2-[2-(hydroxy-kappa O)-5-methoxy-4-[2-(sulfoxo)ethyl]sulfonyl]phenyl]azophenyl]-kappa N]1]-6-sulfo-2-naphthalenyldiazeny]5-oxo-1-(4-sulphenyl)-1H-pyrazole-3-carboxylato(6-)]-, sodium (1:4)	87140-43-0	Intentional addition / 1,000ppm	chemical products
17807	Octane, 1,3,5-trichloro-7,7-dimethyl-, (R,R)-	87147-86-2	Intentional addition / 1,000ppm	chemical products
17808	Octane, 1,3,5-trichloro-7,7-dimethyl-, (R,S)-	87147-87-3	Intentional addition / 1,000ppm	chemical products
17809	Boric acid, B-[2-(hydroxymethyl)phenyl]-	87199-14-2	Intentional addition / 1%	chemical products
17810	3-(Hydroxymethyl)phenylboronic acid	87199-15-3	Intentional addition / 1%	chemical products
17811	3-(Dihydroxybutyl)benzaldehyde	87199-16-4	Intentional addition / 1%	chemical products
17812	Boric acid, (4-formylphenyl)-	87199-17-5	Contains (regardless of intentional or impurities)	chemical products
17813	3-Hydroxyphenylboronic acid	87199-18-6	Intentional addition / 1%	chemical products
17814	Trimethyl(triethylphosphine)indium	87224-89-3	Intentional addition / 1%	chemical products
17815	Trimethyl(triethylamine)indium	87224-90-6	Intentional addition / 1%	chemical products
17816	Phenol, 4-tripropylene-	87247-00-5	Intentional addition / 1%	chemical products
17817	Octane, 1,3,5-trichloro-7,7-dimethyl-	87260-59-1	Intentional addition / 1,000ppm	chemical products
17818	2-(2-Fluoroacetyl)amino-5-nitrobenzoic acid	87266-10-2	Intentional addition / 1%	chemical products
17819	Benzenebutanoic acid, alpha-[[1-carboxoethyl]amino]-gamma-oxo-, monoethyl ester, [S-(R*,R*)-]	87269-99-6	Contains (regardless of intentional or impurities)	chemical products
17820	Cobalt(1+), tris(1-nitroso-2-naphthalenolato-N1,O2)-	87391-39-7	Intentional addition / 1%	chemical products
17821	1,2-Benzodioxol-3(1H)-one, 1,1,1-tris(acetyloxy)-1,1-dihydro-	87413-09-0	Contains (regardless of intentional or impurities)	chemical products
17822	4-Octene, 1-bromo-3,7-dimethyl-	87477-85-8	Intentional addition / 1,000ppm	chemical products
17823	Decane, 1,3,5,7-tetrachloro-9,9-dimethyl-, (3R*,5S*,7S*)	87562-53-6	Intentional addition / 1,000ppm	chemical products
17824	Decane, 1,3,5,7-tetrachloro-9,9-dimethyl-, (3R*,5R*,7S*)	87585-26-0	Intentional addition / 1,000ppm	chemical products
17825	Decane, 1,3,5,7-tetrachloro-9,9-dimethyl-, (3R*,5R*,7R*)	87585-27-1	Intentional addition / 1,000ppm	chemical products
17826	Decane, 1,3,5,7-tetrachloro-9,9-dimethyl-, (3R*,5S*,7R*)	87585-28-2	Intentional addition / 1,000ppm	chemical products
17827	3,5,7,9-Tetraoxa-4,8-disila-6-stannaundecane, 6,6-dibutyl-4,4,8,8-tetraethoxy-	87735-26-0	Contains (regardless of intentional or impurities)	chemical products
17828	Hydrocarbons, C4	87741-01-3	Contains (regardless of intentional or impurities)	chemical products
17829	Tetrabutylammonium tribromocarbonylplatinate	87793-14-4	Contains (regardless of intentional or impurities)	chemical products
17830	N-Benzyl-N-(trimethylsilylmethyl)aminoacetoneitrile	87813-07-8	Intentional addition	chemical products
17831	Pentanoic acid, 2-propyl-, manganese(2+) salt	87835-28-7	Contains (regardless of intentional or impurities)	chemical products
17832	Pentanoic acid, 2-propyl-, cadmium salt	87835-30-1	Contains (regardless of intentional or impurities)	chemical products
17833	Pentanoic acid, 2-propyl-, copper(2+) salt	87835-31-2	Intentional addition / 1,000ppm	chemical products
17834	Strychnidin-10-one, mono(-)-[[2-bromophenyl)methyl]sulfinyl]acetate]	87852-56-0	Contains (regardless of intentional or impurities)	chemical products
17835	Strychnidin-10-one, mono(+)-[[2-bromophenyl)methyl]sulfinyl]acetate]	87852-72-0	Contains (regardless of intentional or impurities)	chemical products
17836	Chromium, I6-amino-5-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthalenesulfonato(3-)]-	87912-16-1	Intentional addition / 1,000ppm	chemical products
17837	Boron, diphenoxyl(1-phenyl)-1,3-decanedionato(O,O)-, (T-4)-	87912-25-2	Intentional addition / 1%	chemical products
17838	Carboxymethyl cellulose cobalt salt	87914-02-1	Intentional addition / 1%	chemical products
17839	Molybdenum carbide (MoC0.6)	87970-74-9	Intentional addition / 1,000ppm	chemical products
17840	Mixture of (dichlorophosphino)biphenyl (mixture) and 2(or 3 or 4)2'(or 3' or 4')-bis(dichloro phosphino)biphenyl (mixture)	87989-51-3	Contains (regardless of intentional or impurities)	chemical products
17841	Chromate(1-), bis[4-[(3,5-dichloro-2-hydroxyphenyl)azo]-3-hydroxy-N-phenyl-2-naphthalenecarboxamidato(2-)]-, sodium	88031-28-1	Contains (regardless of intentional or impurities)	chemical products
17842	Zinc chloride	88103-06-4	Intentional addition / 1%	chemical products
17843	Strychnidin-10-one, compound with 5-nitro-2,4,6,8,11,13,15H-pyrimidinetrione	88154-35-2	Contains (regardless of intentional or impurities)	chemical products
17844	4-Azidobutan-1-amine	88192-20-5	Contains (regardless of intentional or impurities)	chemical products
17845	Phosphoric acid, nickel(3+) salt (1:1)	88248-80-6	Intentional addition / 1,000ppm	chemical products
17846	Chromium, acetate hydroxy sulfate aluminum complexes	88272-88-8	Intentional addition / 1,000ppm	chemical products
17847	4-Chloro-1,2-dihydro-3H-2-azaacenaphthylene-3-one	88283-76-5	Contains (regardless of intentional or impurities)	chemical products
17848	1-Propane, 1-(4-chlorophenyl)-2-methyl-2-(4-morpholinyl)-	88324-57-6	Contains (regardless of intentional or impurities)	chemical products
17849	Pentahydrogen bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]naphthalene-2,7-disulphonato(4-)]chromate(5-)]-	88330-20-5	Contains (regardless of intentional or impurities)	chemical products
17850	Pentahydrogen bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]naphthalene-2,7-disulphonato(4-)]cobaltate(5-)]-	88330-21-6	Intentional addition / 1%	chemical products
17851	Cuprate(5-), [5-hydroxy-2-[[4-[[5-hydroxy-6-[[2-methoxy-5-[[phenylamino]carbonyl]phenyl]azo]-7-sulfo-2-naphthalenyl]amino]-6-[[3-sulfophenyl]amino]-1,3,5-triazin-2-yl]amino]-6-[[2-hydroxy-5-sulfophenyl]azo]-1,7-naphthalenedisulfonato(7-)]-, pentasodium	88358-67-2	Intentional addition / 1,000ppm	chemical products
17852	Chromate(1-), bis[1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]-, hydrogen, compound with 1-tetradecanamine (1:1)	88377-66-6	Contains (regardless of intentional or impurities)	chemical products
17853	Heptane, 1-bromo-4-methyl-	88467-55-4	Intentional addition / 1,000ppm	chemical products
17854	Copper, [29,31H-phthalocyanine-C.C.C.C-tetrasulfonyl tetrachloridato(2-)-N29,N30,N31,N32]-	88548-02-1	Intentional addition / 1,000ppm	chemical products
17855	Gold selenide (AuSe2)	88608-76-8	Contains (regardless of intentional or impurities)	chemical products
17856	Butanoic acid, 2-methyl-, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (3:1)	88660-49-5	Contains (regardless of intentional or impurities)	chemical products
17857	Hexadecanoic acid, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (3:1)	88660-50-8	Contains (regardless of intentional or impurities)	chemical products
17858	(S)-Nicotine dicitrate	88660-51-9	Contains (regardless of intentional or impurities)	chemical products
17859	Butanedioic acid, hydroxy-, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (2:1)	88660-52-0	Contains (regardless of intentional or impurities)	chemical products
17860	Benzoic acid, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	88660-53-1	Contains (regardless of intentional or impurities)	chemical products
17861	Benzenoacetic acid, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	88660-54-2	Contains (regardless of intentional or impurities)	chemical products
17862	1,2-Benzenedicarboxylic acid, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	88660-55-3	Contains (regardless of intentional or impurities)	chemical products
17863	Propanoic acid, 2-oxo-, compound with (S)-2-(1-methyl-2-pyrrolidinyl)pyridine (2:1)	88660-56-4	Contains (regardless of intentional or impurities)	chemical products
17864	Glutamic acid, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	88660-57-5	Contains (regardless of intentional or impurities)	chemical products
17865	Aspartic acid, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	88660-58-6	Contains (regardless of intentional or impurities)	chemical products
17866	Benzoic acid, 2-hydroxy-5-sulfo-, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	88660-59-7	Contains (regardless of intentional or impurities)	chemical products
17867	Pectic acid, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine	88660-60-0	Contains (regardless of intentional or impurities)	chemical products
17868	Platinate(2-), hexachloro-, (OC-6-11)-, dihydrogen, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	88660-62-2	Contains (regardless of intentional or impurities)	chemical products
17869	Silicic acid, (H4SiO4), tungsten complex, compound with nicotine	88660-63-3	Contains (regardless of intentional or impurities)	chemical products
17870	Myclobutanil	88671-89-0	Contains (regardless of intentional or impurities)	chemical products
17871	Pentanoic acid, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (3:1)	88673-56-7	Contains (regardless of intentional or impurities)	chemical products
17872	Dodecanoic acid, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (3:1)	88673-57-8	Contains (regardless of intentional or impurities)	chemical products
17873	Pyributicarb	88678-67-5	Intentional addition / 1%	chemical products
17874	2,2,3,3,4,5,6-Heptabromo[1,1'-biphenyl]	88700-04-3	Intentional addition / 1,000ppm	chemical products
17875	2,3,3',4,4',5,5'-Heptabromobiphenyl	88700-06-5	Intentional addition / 1,000ppm	chemical products
17876	Isoctanoic acid, copper salt	88859-94-3	Intentional addition / 1,000ppm	chemical products
17877	Octadecanoic acid rhodium(2+) salt	88902-97-0	Intentional addition / 1%	chemical products
17878	Zirconium, bis(2,4-pentanedionato(O,O')dipropoxy-	88937-09-1	Contains (regardless of intentional or impurities)	chemical products
17879	Undecane, 5-chloro-7-(2,2-trichloroethyl)-	88938-19-6	Intentional addition / 1,000ppm	chemical products
17880	Glycine, N-[5-(acetamino)-4-(2-(2-bromo-4,6-dinitrophenyl)diazonyl]-2-methoxyphenyl]-N-(2-methoxy-2-oxoethyl)-, methyl ester	88938-51-6	Contains (regardless of intentional or impurities)	chemical products
17881	Ethanedioic acid, copper(1+) salt	89038-03-9	Intentional addition / 1,000ppm	chemical products
17882	Manganese(II) oxalate, hydrate	89087-78-5	Intentional addition / 1%	chemical products
17883	2,2,6-Trichloro-6-(1-chloroisobutyl)cyclohexane	89110-96-3	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17884	1-Octadecanaminium, N,N-dimethyl-N-octadecyl-, hexa-mu-oxotetra-mu-3-oxodi-mu-5-oxotetradecaooctamolybdad e(4-) (4:1)	89114-06-7	Contains (regardless of intentional or impurities)	chemical products
17885	2-Methyl-4-nitro-1H-imidazole-1-propane nitrile	89128-08-5	Intentional addition	chemical products
17886	Trinitro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	89139-22-0	Intentional addition / 1,000ppm	chemical products
17887	Molybdenum vanadium oxide (MoV04)	89256-12-2	Intentional addition / 1,000ppm	chemical products
17888	(Z)-2-Methylacetophenone 4,6-dimethylpyrimidine-2-yl hydrazon	89269-64-7	Intentional addition / 1%	chemical products
17889	9-Octadecenoic acid (9Z)-, (2-hydroxy-1,3,2-dioxaborolan-4-yl)methyl ester	89325-22-4	Intentional addition / 1%	chemical products
17890	Propanoic acid, 3-bromo-2-methyl-, (R)-	89361-97-7	Contains (regardless of intentional or impurities)	chemical products
17891	4-Aminobenzenboronic acid	89415-43-0	Intentional addition / 1%	chemical products
17892	Sulfonium, (thio)-4-phenylenebis(diphenyl-, bis[(OC-6-11)-hexafluoroantimonate(1-)]	89452-37-9	Contains (regardless of intentional or impurities)	chemical products
17893	3-Amino-5-nitrobenzenboronic acid	89466-05-7	Intentional addition / 1%	chemical products
17894	2-Hydroxybenzenboronic acid	89466-08-0	Intentional addition / 1%	chemical products
17895	6-Bromo-2-methoxyphenylboronic acid	89466-18-2	Contains (regardless of intentional or impurities)	chemical products
17896	5-Chloro-2-hydroxybenzenboronic acid	89488-25-5	Intentional addition / 1%	chemical products
17897	Cyclohex-1-ene-1-boronic acid	89490-05-1	Intentional addition / 1%	chemical products
17898	Phenol, 2-tert-nonyl-	89585-88-2	Intentional addition / 1%	chemical products
17899	3-Bromophenylboronic acid	89598-96-9	Intentional addition / 1%	chemical products
17900	2,4-Dimethoxypyrimidine-5-boronic acid	89641-18-9	Intentional addition / 1%	chemical products
17901	Molybdenum(1+), [[N,N'-1,2-ethanediybis[N-(carboxymethyl)glycino]](4-)-N,N',O,O',ON,ON']-, (OC-6-21)-	89654-51-3	Intentional addition / 1,000ppm	chemical products
17902	Molybdenum(2+), [[N,N'-1,2-ethanediybis[N-(carboxymethyl)glycino]](4-)-N,N',O,O',ON,ON']-, (OC-6-21)-	89654-52-4	Intentional addition / 1,000ppm	chemical products
17903	5-Bromo-2-methoxyphenylboronic acid	89694-45-1	Intentional addition / 1%	chemical products
17904	2-Chloro-5-methoxybenzenboronic acid	89694-46-2	Intentional addition / 1%	chemical products
17905	Boronic acid, B-(5-chloro-2-methoxyphenyl)-	89694-48-4	Intentional addition / 1%	chemical products
17906	Benzeneselenazolium, 3-(2-carboxyethyl)-2-[2-[[3-(2-carboxyethyl)-5-methyl-2(3H)-benzeneselenazolidene]methyl]-1-butenyl]-5-methyl-, bromide	89703-05-9	Contains (regardless of intentional or impurities)	chemical products
17907	2-Chloroformyl-1-pyrrolidinecarboxylatebenzyl	89705-40-8	Intentional addition / 1%	chemical products
17908	Cadmium acetate hydrate	89759-80-8	Contains (regardless of intentional or impurities)	chemical products
17909	(RS)-[O-1-(4-Chlorophenyl)pyrazol-4-yl] O-ethyl S-propyl phosphorothioate	89784-60-1	Intentional addition / 1%	chemical products
17910	2-Isopropylbenzenboronic acid	89787-12-2	Intentional addition / 1%	chemical products
17911	Cuprate(4-), [3-carboxy-1-[4-[[3-[[[2-carboxy-5-sulfonylphenyl]azophenyl]methyl]azo]-2-hydroxy-5-sulfonyl]amino]-6-[[2-chloro-5-sulfonyl]amino]-1,3,5-triazin-2-yl]pyridiniumato(7-)]-, trisodium hydrogen	89797-01-3	Contains (regardless of intentional or impurities)	chemical products
17912	3-(Diethylboryl)pyridine	89878-14-8	Intentional addition / 1%	chemical products
17913	Cobaltate(1-), [6-amino-5-[[2-hydroxy-4-nitrophenyl]azo]-N-methyl-2-naphthalenesulfonamido(2-)](2-)[2-[2-hydroxy-5-[[1-(1-methylethyl)amino]sulfonyl]phenyl]azo]-3-oxo-N-phenylbutanamido(2-)]-, sodium	89899-23-0	Intentional addition / 1%	chemical products
17914	Chromate(3-), [6-(2,3-dibromo-1-oxopropyl)amino]-4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfonyl]azo]-2-naphthalenesulfonato(4-)](2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, trisodium	89899-24-1	Contains (regardless of intentional or impurities)	chemical products
17915	Sodium [3-hydroxy-4-[[1-(1-hydroxy-5-sulpho-2-naphthyl)azo]naphthalene-1-sulphonato(4-)]chromate(1-)	89899-25-2	Contains (regardless of intentional or impurities)	chemical products
17916	Cuprate(4-), [mu-[[4-[[[3,3-dihydroxy-4'-[[1-(1-hydroxy-3,8-disulfo-2-naphthalenyl)azo]](1,1'-biphenyl)-4-yl]azo]-5-hydroxy-7-sulfo-2-naphthalenyl]amino]phenoxy]acetato(8-)]di-, tetrasodium	89899-26-3	Intentional addition / 1,000ppm	chemical products
17917	Trisodium [mu-[[4-[[[8-benzamido-1-hydroxy-3-sulpho-2-naphthyl]azo]-3,3'-dihydroxy[[1,1'-biphenyl]-4-yl]azo]-3-hydroxy]naphthalene-2,7-disulphonato(7-)]dicuprate(3-)	89899-27-4	Intentional addition / 1,000ppm	chemical products
17918	Trisodium [mu-[[6-[[[8-benzamido-1-hydroxy-3-sulpho-2-naphthyl]azo]-3,3'-dihydroxy[[1,1'-biphenyl]-4-yl]azo]-7-hydroxy]naphthalene-1,3-disulphonato(7-)]dicuprate(3-)	89899-28-5	Intentional addition / 1,000ppm	chemical products
17919	Cuprate(3-), [mu-[[2-[[6-[[[4-[[2-[4-[[2-(2-carboxyphenyl)azo]-2,3-dihydro-5-methyl-3-oxo-1H-pyrazol-1-yl]-2-sulfonyl]ethenyl]-3-sulfonyl]amino]-6-(phenylamino)-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(7-)]di-, trisodium	89910-72-5	Intentional addition / 1,000ppm	chemical products
17920	Sodium 1-amino-9,10-dihydro-9,10-dioxo-4-[[3-[[1-oxopropyl]amino]phenyl]amino]anthracene-2-sulphonate	89923-62-6	Contains (regardless of intentional or impurities)	chemical products
17921	Sodium [3-[[4-chloro-2-hydroxy-5-methoxyphenyl]azo]-4-hydroxynaphthalene-2,7-disulphonato(4-)]chromate(1-)	89923-63-7	Contains (regardless of intentional or impurities)	chemical products
17922	5,1,2-Trioxa-6-stannatracocta-2,9-dienoic acid, 6,6-dimethyl-4,8,11-trioxo-, octadecyl ester, (Z,Z)-	89930-84-7	Intentional addition / 1,000ppm	chemical products
17923	Cuprate(4-), [2-[[2-[[2-[[3-[[4-chloro-6-[[ethoxy]sulfonyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa-O)-5-sulfonyl]diazenyl-kappa.N2]phenylmethyl]diazenyl-kappa.N1]-4-sulfobenzoato(6-)-kappa.O]-, hydrogen (1:4)	89933-61-9	Intentional addition / 1,000ppm	chemical products
17924	Cuprate(4-), [2-[[2-[[2-[[3-[[4-chloro-6-[[ethoxy]sulfonyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa-O)-5-sulfonyl]diazenyl-kappa.N2]phenylmethyl]diazenyl-kappa.N1]-4-sulfobenzoato(6-)-kappa.O]-, hydrogen (1:4), (SP-4-3)-	89933-65-3	Intentional addition / 1,000ppm	chemical products
17925	Tetrakis(pyridine)silver(I) dichromate	89952-87-4	Intentional addition / 1,000ppm	chemical products
17926	Hexanedioyl dichloride, 2,2,4(or 2,4,4)-trimethyl-	89982-04-7	Intentional addition / 1%	chemical products
17927	2-Ethylphenylboronic acid	90002-36-1	Intentional addition / 1%	chemical products
17928	Copper chromate	90014-70-3	Intentional addition / 1,000ppm	chemical products
17929	Flocoumafen	90035-08-8	Contains (regardless of intentional or impurities)	chemical products
17930	Phosphoric acid, nickel(2+) zinc salt (2:1:2)	90053-13-7	1,000ppm	chemical products
17931	4-(Carboxymethyl)phenylboronic acid	90111-58-3	1%	chemical products
17932	Cuprate(4-), [29H,31H-phthalocyanine-C.C.C.C-tetrasulfonato(6-)-N29,N30,N31,N32]-, tetrahydrogen, compound with 2-(dimethylamino)ethanol (1:1)	90130-10-2	Intentional addition / 1,000ppm	chemical products
17933	Antimony, acetylacetone chloro complexes	90170-79-9	Contains (regardless of intentional or impurities)	chemical products
17934	Baddeleyite, vanadium green	90170-88-0	Intentional addition / 1%	chemical products
17935	Benzene, 2,4-dichloro-1,3,5-trinitro-, copper-coupled	90171-11-2	Intentional addition / 1,000ppm	chemical products
17936	Phosphorodithioic acid, O,O-bis[[1,1-dimethylethyl] ester, antimony(3+) salt	90177-43-8	Contains (regardless of intentional or impurities)	chemical products
17937	Benzenesulfonic acid, mono-C10-13-alkyl derivatives, cadmium salts	90194-35-7	Contains (regardless of intentional or impurities)	chemical products
17938	Benzenesulfonic acid, mono-C15-36-branched alkyl derivatives, barium salts	90194-48-2	Intentional addition / 1,000ppm	chemical products
17939	(Z)-2-(5-Dichlorophosphorylamino)-2,4-thiadiazol-3-yl)-2-(ethoxymethyl)acetyl chloride	90211-01-1	Contains (regardless of intentional or impurities)	chemical products
17940	Benzenesulfonic acid, 2-formyl-, sodium salt, reaction products with disodium selenite and potassium cyanide	90218-42-1	Contains (regardless of intentional or impurities)	chemical products
17941	Benzoic acid, cadmium salt, basic	90218-85-2	Contains (regardless of intentional or impurities)	chemical products
17942	Benzoic acid, nonyl-, branched, barium salts	90219-01-5	Intentional addition / 1,000ppm	chemical products
17943	Pentahydrogen bis[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]naphthalene-2,7-disulphonato(4-)]chromate(5-)	90241-26-2	Contains (regardless of intentional or impurities)	chemical products
17944	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, compounds with 2-(dimethylamino)ethanol	90247-33-9	Intentional addition / 1,000ppm	chemical products
17945	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl sulfo derivatives	90247-34-0	Intentional addition / 1,000ppm	chemical products
17946	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl sulfo derivatives, compounds with 2-(dimethylamino)ethanol	90247-35-1	Intentional addition / 1,000ppm	chemical products
17947	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfonated, compounds with 2-(dimethylamino)ethanol	90247-36-2	Intentional addition / 1,000ppm	chemical products
17948	8,11-Dioxo-3,5-dithia-4-stannatridecanoic acid, 4,4-dibutyl-7-oxo-, 2-ethoxyethyl ester	90264-80-5	Intentional addition / 1,000ppm	chemical products
17949	Boric acid (H3BO3), reaction products with diethanolamine	90268-17-0	1%	chemical products
17950	Boric acid (H3BO3), reaction products with glycerol, potassium salts	90268-18-1	1%	chemical products
17951	Cassiterite, vanadium zirconium green	90269-03-7	Contains (regardless of intentional or impurities)	chemical products
17952	2-Hexene, 1-bromo-2,4-dimethyl-, [R-(-)]	90289-86-4	1,000ppm	chemical products
17953	Chromate(2-), [4-[[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydro-N-(2-hydroxyethyl)-5-oxo-1-phenyl-1H-pyrazole-3-carboxamidato(2-)](4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, sodium	90294-35-2	Contains (regardless of intentional or impurities)	chemical products
17954	Chromate(2-), [4-[[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)](4-[[5-chloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	90294-36-3	Contains (regardless of intentional or impurities)	chemical products
17955	Chromate(2-), [4-[[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)](4-[[3,5-dichloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	90294-37-4	Contains (regardless of intentional or impurities)	chemical products
17956	Chromate(2-), [3-[[[5-[[2-(4-nitrophenyl)azo]-2-hydroxyphenyl]methylene]amino]-4-hydroxybenzenesulfonamido(2-)](2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(3-)]-, lithium sodium	90294-38-5	Contains (regardless of intentional or impurities)	chemical products
17957	Chromate(2-), [5-(diethylamino)-2-[[2-hydroxy-4-nitrophenyl]azo]phenolato(2-)](5-hydroxy-6-[[2-hydroxy-4-nitrophenyl]azo]-1-naphthalenesulfonato(3-)]-, sodium	90294-39-6	Contains (regardless of intentional or impurities)	chemical products
17958	Chromate(2-), [3-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)](2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	90294-40-9	Contains (regardless of intentional or impurities)	chemical products
17959	Chromate(2-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)](2-[[2-hydroxy-5-methoxyphenyl]azo]-4,6-dinitrophenolato(2-)]-, sodium	90294-41-0	Contains (regardless of intentional or impurities)	chemical products
17960	Chromate(2-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-nitrobenzoato(2-)](2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfonyl)phenyl]azo]-1H-pyrazol-4-yl]azo]benzoato(3-)]-, sodium	90294-42-1	Contains (regardless of intentional or impurities)	chemical products
17961	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)](1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, sodium	90294-43-2	Contains (regardless of intentional or impurities)	chemical products
17962	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)](1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]-, sodium	90294-44-3	Contains (regardless of intentional or impurities)	chemical products
17963	Chromate(3-), bis[5-chloro-3-[[1-(2-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(3-)]-, sodium	90294-45-4	Contains (regardless of intentional or impurities)	chemical products
17964	Chromate(3-), bis[4-[[1-(2,5-dichlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, potassium sodium	90294-46-5	Contains (regardless of intentional or impurities)	chemical products
17965	Chromate(3-), bis[4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, potassium sodium	90294-47-6	Contains (regardless of intentional or impurities)	chemical products
17966	Chromate(3-), bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(3-)]-, lithium sodium	90294-48-7	Contains (regardless of intentional or impurities)	chemical products
17967	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonato(3-)]-, potassium sodium	90294-49-8	Contains (regardless of intentional or impurities)	chemical products
17968	Chromate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, lithium sodium	90294-50-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
17969	Chromate(3-), bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-, potassium sodium	90294-51-2	Contains (regardless of intentional or impurities)	chemical products
17970	Chromate(3-), bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium	90294-52-3	Contains (regardless of intentional or impurities)	chemical products
17971	Chromate(3-), [4-[(5-chloro-2-hydroxyphenyl)azo]-4,5-dihydro-5-oxo-1-phenyl-1H-pyrazole-3-carboxylato(3-)]-[4-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, sodium	90294-53-4	Contains (regardless of intentional or impurities)	chemical products
17972	Chromate(3-), [4-[(3,5-dichloro-2-hydroxyphenyl)azo]-4,5-dihydro-5-oxo-1-phenyl-1H-pyrazole-3-carboxylato(3-)]-[4-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, sodium	90294-54-5	Contains (regardless of intentional or impurities)	chemical products
17973	Chromate(5-), bis[6-amino-4-hydroxy-3-[[2-(2-hydroxy-4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl)azo]-2-naphthalenesulfonato(4-)]-, sodium	90294-55-6	Contains (regardless of intentional or impurities)	chemical products
17974	Chromate(5-), bis[7-amino-4-hydroxy-3-[[2-(2-hydroxy-4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl)azo]-2-naphthalenesulfonato(4-)]-, sodium	90294-56-7	Contains (regardless of intentional or impurities)	chemical products
17975	Chromate(5-), [5-[[[2,3-dichloro-6-quinoxaliny]carbonyl]amino]-4-hydroxy-3-[[2-(2-hydroxy-5-nitro-3-sulfoxyphenyl)azo]-2,7-naphthalenedisulfonato(5-)]]-[6-hydroxy-5-[[2-(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenesulfonato(3-)]-, potassium sodium	90294-57-8	Contains (regardless of intentional or impurities)	chemical products
17976	Chromate(5-), bis[4-hydroxy-3-[[2-(2-hydroxy-3,5-dinitrophenyl)azo]-6-[[sulfo(methyl)amino]-2-naphthalenesulfonato(4-)]-, sodium	90294-58-9	Contains (regardless of intentional or impurities)	chemical products
17977	Chromate(7-), bis[5-(acetylamino)-4-hydroxy-3-[[2-(2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl)azo]-2,7-naphthalenedisulfonato(5-)]-, sodium	90294-59-0	Contains (regardless of intentional or impurities)	chemical products
17978	Chromate(7-), bis[5-[[4-chloro-6-[[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-(2-hydroxy-5-nitrophenyl)azo]-2,7-naphthalenedisulfonato(5-)]-, sodium	90294-60-3	Contains (regardless of intentional or impurities)	chemical products
17979	Chromic acid (H2Cr2O7), disodium salt, reaction products with diazotized 2-amino-4,6-dinitrophenol-4-hydroxy-6-[[sulfo(methyl)amino]-2-naphthalenesulfonic acid monosodium salt reaction products	90294-61-4	Contains (regardless of intentional or impurities)	chemical products
17980	Chromium, acetylacetone 6-methyl-2,4-heptanedione complexes	90294-62-5	1,000ppm	chemical products
17981	Chromium, 6-amino-5-[[2-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenesulfonate hydroxy ammonium sodium complexes	90294-63-6	1,000ppm	chemical products
17982	Chromium, N-[8-[[4-(aminosulfonyl)-5-chloro-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]acetamide 2-chloro-5-hydroxy-4-[[2-(2-hydroxy-1-naphthalenyl)azo]benzenesulfonamide complexes	90294-64-7	1,000ppm	chemical products
17983	Chromium, 5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulfoxyphenyl)-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonate hydroxy ammonium sodium complexes	90294-65-8	1,000ppm	chemical products
17984	Chromium, chloro hydrogenated tallow fatty acids hydroxy complexes	90294-66-9	1,000ppm	chemical products
17985	Chromium, chloro hydroxy methacrylate oxo complexes	90294-67-0	1,000ppm	chemical products
17986	Chromium, 6-[[5-chloro-2-hydroxy-4-nitrophenyl]azo]-5-hydroxy-1-naphthalenesulfonate 3-hydroxy-4-[[2-(2-hydroxy-1-naphthalenyl)azo]-1-naphthalenesulfonate potassium sodium complexes	90294-68-1	1,000ppm	chemical products
17987	Chromium, chloro hydroxy stearate complexes	90294-69-2	1,000ppm	chemical products
17988	Chromium, diazotized 4-amino-3-hydroxy-7-nitro-1-naphthalenesulfonic acid-diazotized 2-amino-4-nitrophenol-resorcinol coupling products copper sodium complexes	90294-70-5	Intentional addition / 1,000ppm	chemical products
17989	Chromium, 2,5-dichloro-4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonate 3-hydroxy-4-[[2-(2-hydroxy-1-naphthalenyl)azo]benzenesulfonate potassium sodium complexes	90294-71-6	1,000ppm	chemical products
17990	Chromium, 3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonamide 3-hydroxy-4-[[2-(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonate sodium complexes	90294-72-7	1,000ppm	chemical products
17991	Chromium, 4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonate hydroxy ammonium sodium complexes	90294-73-8	1,000ppm	chemical products
17992	Chromium, 3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonate hydroxy ammonium sodium complexes	90294-74-9	1,000ppm	chemical products
17993	Chromium, 2-[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulfoxyphenyl)-1H-pyrazol-4-yl]azo]benzoate hydroxy ammonium sodium complexes	90294-75-0	1,000ppm	chemical products
17994	Chromium, 4-hydroxy-2-[[2-(2-hydroxy-3,5-dinitrophenyl)azo]-1-naphthalenesulfonate 5-hydroxy-6-[[2-(2-hydroxy-3,5-dinitrophenyl)azo]-1-naphthalenesulfonate 3-hydroxy-4-[[2-(2-hydroxy-1-naphthalenyl)azo]-1-naphthalenesulfonate complexes, compounds with N-butyl-1-butanamine and N-cyclohexylcyclohexanamine	90294-76-1	1,000ppm	chemical products
17995	Chromium, 3-hydroxy-4-[[2-(2-hydroxy-1-naphthalenyl)azo]-1-naphthalenesulfonate 3-hydroxy-4-[[2-(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonate potassium sodium complexes	90294-77-2	1,000ppm	chemical products
17996	Chromium, 3-hydroxy-4-[[1-(1-hydroxy-8-sulfo-2-naphthalenyl)azo]-1-naphthalenesulfonate hydroxy ammonium sodium complexes	90294-78-3	1,000ppm	chemical products
17997	Cobalt, acetylacetone 6-methyl-2,4-heptanedione complexes	90294-79-4	Intentional addition / 1%	chemical products
17998	Cobalt, C8-10-branched fatty acids C9-11-neofatty acids naphthenate complexes	90294-80-7	Intentional addition / 1%	chemical products
17999	Cobalt, chloro 29H,31H-phthalocyanineidibis(carbonylimino-4,1-phenylene)dithiocyanate complexes	90294-81-8	Intentional addition / 1%	chemical products
18000	Cobalt, 2-ethylhexanoate naphthenate complexes	90294-82-9	Intentional addition / 1%	chemical products
18001	Cobalt, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfonated, sodium salts	90294-83-0	Intentional addition / 1%	chemical products
18002	Cobaltate(3-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, potassium sodium	90294-84-1	Intentional addition / 1%	chemical products
18003	Cobaltate(3-), bis[4-[[2-[[2-(2-hydroxy-5-nitrophenyl)azo]-1,3-dioxobutyl]amino]-5-methoxy-2-methylbenzenesulfonato(3-)]-, ammonium sodium	90294-85-2	Intentional addition / 1%	chemical products
18004	Cobaltate(7-), bis[5-[[4-chloro-6-[[5-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-sulfoxyphenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-(2-hydroxy-5-nitrophenyl)azo]-2,7-naphthalenedisulfonato(5-)]-, lithium sodium	90294-86-3	Intentional addition / 1%	chemical products
18005	Cobaltate(7-), bis[5-[[4-chloro-6-[[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-(2-hydroxy-5-nitrophenyl)azo]-2,7-naphthalenedisulfonato(5-)]-, sodium	90294-87-4	Intentional addition / 1%	chemical products
18006	Copper, acetylacetone 6-methyl-2,4-heptanedione complexes	90294-89-6	Intentional addition / 1,000ppm	chemical products
18007	Copper, 4-[[4-(aminophenyl)azo]benzoic acid-2,2-(1,2-ethenediyl)bis(5-nitrobenzenesulfonic acid)-4-hydroxy-3-[[2-methoxy-4-(methylamino)phenyl]azo]benzenesulfonic acid reaction products sodium complexes	90294-90-9	Intentional addition / 1,000ppm	chemical products
18008	Copper, C8-10-branched fatty acids C9-11-neofatty acids naphthenate potassium sodium complexes	90294-91-0	Intentional addition / 1,000ppm	chemical products
18009	Copper, C5-23-branched carboxylate octanoate complexes	90294-92-1	Intentional addition / 1,000ppm	chemical products
18010	Copper, C4-10 fatty acid naphthenate complexes	90294-93-2	Intentional addition / 1,000ppm	chemical products
18011	Copper, coco allylamine diethylenetriamine complexes	90294-94-3	Intentional addition / 1,000ppm	chemical products
18012	Copper, complexes with 7-amino-4-hydroxy-2-naphthalenesulfonic acid-carbonic dichloride reaction product coupled with diazotized 2-aminobenzoic acid and diazotized 2-amino-4-chlorophenol	90294-95-4	Intentional addition / 1,000ppm	chemical products
18013	Copper, complexes with 6(or 7)-amino-1-naphthalenesulfonic acid-m(or p)-cresol-sodium sulfide (Na2(Sx)) reaction products, sodium salts	90294-96-5	Intentional addition / 1,000ppm	chemical products
18014	Copper, diazotized 4-amino-3-hydroxy-7-nitro-1-naphthalenesulfonic acid-diazotized o-tolidine-resorcinol coupling products complexes	90294-97-6	Intentional addition / 1,000ppm	chemical products
18015	Copper, 5-[[4-[[8-[[2,4-dihydroxy-3-[[2-methoxy-5-sulfoxyphenyl]azo]phenyl]azo]-1-hydroxy-3,6-disulfo-2-naphthalenyl]azo]-3,3-dimethoxy[1,1'-biphenyl]-4-yl]azo]-2-hydroxybenzoate sodium complexes	90294-98-7	Intentional addition / 1,000ppm	chemical products
18016	Copper, EDTA complexes	90294-99-8	Intentional addition / 1,000ppm	chemical products
18017	Copper, 8-hydroxy-7-[[3(or 3')-hydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-3(or 3')-methoxy[1,1'-biphenyl]-4-yl]azo]-1,3,6-naphthalenetrisulfonate sodium complexes	90295-00-4	Intentional addition / 1,000ppm	chemical products
18018	Copper, 29H,31H-phthalocyanine thiocyanato complexes, reaction products with sodium sulfide (Na2(Sx)), leuco	90295-02-6	Intentional addition / 1,000ppm	chemical products
18019	Copper, [chloro-29H,31H-phthalocyanine]triaminato(2-)-N29,N30,N31,N32]-, sulfurized, (sulfothio) derivatives, sodium salts	90295-03-7	Intentional addition / 1,000ppm	chemical products
18020	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[2-carboxy-4-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]phenyl]amino]sulfonyl sulfo derivatives, sodium salts	90295-04-8	Intentional addition / 1,000ppm	chemical products
18021	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[2-(chloroethyl)amino]sulfonyl sulfo derivatives	90295-05-9	Intentional addition / 1,000ppm	chemical products
18022	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[3-[[4-chloro-6-[[3-sulfoxyphenyl]amino]-1,3,5-triazin-2-yl]amino]-4-sulfoxyphenyl]amino] sulfo derivatives, sodium salts	90295-06-0	Intentional addition / 1,000ppm	chemical products
18023	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[3-[[4-fluoro-6-[[3-sulfoxyphenyl]amino]-1,3,5-triazin-2-yl]amino]phenyl]amino] sulfonyl sulfo derivatives, sodium salts	90295-07-1	Intentional addition / 1,000ppm	chemical products
18024	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl sulfo derivatives, ammonium sodium salts	90295-08-2	Intentional addition / 1,000ppm	chemical products
18025	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl sulfo derivatives, ammonium sodium salts, compounds with 2,2,2'-[nitrioltris(2,1-ethanedioxy)]tris[ethano]	90295-09-3	Intentional addition / 1,000ppm	chemical products
18026	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl sulfo derivatives, lithium salts	90295-10-6	Intentional addition / 1,000ppm	chemical products
18027	Copper, [29H,31H-phthalocyaninato(2-)-kappa.N29,kappa.N30,kappa.N31,kappa.N32]-, aminosulfonyl sulfo derivatives, sodium salts	90295-11-7	Intentional addition / 1,000ppm	chemical products
18028	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[2-(chloroethyl)amino]sulfonyl sulfo derivatives	90295-12-8	Intentional addition / 1,000ppm	chemical products
18029	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[2-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]ethyl]amino]sulfonyl sulfo derivatives	90295-13-9	Intentional addition / 1,000ppm	chemical products
18030	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with 2,4-diaminobenzenesulfonic acid, diazotized, coupled with 2,5-dichloro-4-(4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl)benzenesulfonic acid	90295-14-0	Intentional addition / 1,000ppm	chemical products
18031	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with dimethylamine and formaldehyde	90295-15-1	Intentional addition / 1,000ppm	chemical products
18032	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with formaldehyde and 2,3,5-trimethylphenol	90295-16-2	Intentional addition / 1,000ppm	chemical products
18033	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with sodium sulfide	90295-17-3	Intentional addition / 1,000ppm	chemical products
18034	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[5-[[[2,3-dichloro-6-quinoxaliny]carbonyl]amino]-2-sulfoxyphenyl]amino]sulfonyl sulfo derivatives, sodium salts	90295-18-4	Intentional addition / 1,000ppm	chemical products
18035	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-(dimethylamino)propyl]amino]sulfonyl derivatives, acetates	90295-19-5	Intentional addition / 1,000ppm	chemical products
18036	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-(dimethylamino)propyl]amino]sulfonyl sulfo derivatives, sodium salts	90295-20-8	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
18037	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[2-[[2-hydroxyethyl(4-methoxy-6-sulfo-1,3,5-triazin-2-yl)amino]ethyl]amino]sulfonyl sulfo derivatives	90295-21-9	Intentional addition / 1,000ppm	chemical products
18038	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [(3-hydroxypropyl)amino]sulfonyl sulfo derivatives, compounds with 3-[(2-ethylhexyloxy)-1-propanamine]	90295-22-0	Intentional addition / 1,000ppm	chemical products
18039	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfonated, potassium salts	90295-23-1	Intentional addition / 1,000ppm	chemical products
18040	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfonated, potassium salts, compounds with 2,2',2''-[[nitrotris(2,1-ethanedioxy)]tris[ethane]]	90295-24-2	Intentional addition / 1,000ppm	chemical products
18041	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[[[[2-(sulfoxy)ethyl]amino]sulfonyl]phenyl]amino]sulfonyl derivatives, potassium salts	90295-25-3	Intentional addition / 1,000ppm	chemical products
18042	Copper, [29H,31H-phthalocyaninetetra-sulfonyl tetrachlorido(2-)-N29,N30,N31,N32]-, reaction products with 2-amino-4-[(4-amino-6-chloro-1,3,5-triazin-2-yl)amino]benzenesulfonic acid and ammonia, sodium salts	90295-26-4	Intentional addition / 1,000ppm	chemical products
18043	Copper, [tetraphenyl-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfonated, potassium sodium salts	90295-27-5	Intentional addition / 1,000ppm	chemical products
18044	Cuprate(1-), [[[(2-hydroxyethyl)methylamino]sulfonyl]-29H,31H-phthalocyaninesulfonato(3-)-N29,N30,N31,N32]-, [[3-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]sulfonyl derivatives, sodium salts	90295-28-6	Intentional addition / 1,000ppm	chemical products
18045	Cuprate(1-), [29H,31H-phthalocyaninesulfonato(3-)-N29,N30,N31,N32]-, [[3-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]sulfonyl derivatives, sodium salts	90295-29-7	Intentional addition / 1,000ppm	chemical products
18046	Cuprate(2-), [N,N-bis[2-[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]ethyl]-29H,31H-phthalocyaninedisulfonamidato(4-)-N29,N30,N31,N32]-, potassium sodium	90295-30-0	Intentional addition / 1,000ppm	chemical products
18047	Cuprate(2-), [5-[[5-chloro-6-methyl-2-(methylsulfonyl)-4-pyrimidinyl]amino]-4-hydroxy-3-[[2-(2-hydroxyphenyl)azo]-2-naphthalenedisulfonato(4-)]]-, sodium	90295-31-1	Intentional addition / 1,000ppm	chemical products
18048	Cuprate(2-), [4-[[4-[[2-(diethylamino)ethyl]sulfonyl]-2-hydroxyphenyl]azo]-4,5-dihydro-5-oxo-1-(4-sulfofenyl)-1H-pyrazole-3-carboxylato(4-)]]-, sodium	90295-32-2	Intentional addition / 1,000ppm	chemical products
18049	Cuprate(3-), [2-[[[5-(ethenylsulfonyl)-2-hydroxy-3-sulfofenyl]azo]phenylmethyl]azo]-4-sulfobenzoato(5-)]]-, sodium	90295-33-3	Intentional addition / 1,000ppm	chemical products
18050	Cuprate(3-), [2-[[[5-(ethenylsulfonyl)-2-hydroxy-3-sulfofenyl]azo]phenylmethyl]azo]-5-sulfobenzoato(5-)]]-, sodium	90295-34-4	Intentional addition / 1,000ppm	chemical products
18051	Cuprate(3-), [4-hydroxy-3-[[2-(hydroxy-5-sulfofenyl)azo]-7-methyl[[2-(sulfoxy)ethyl]sulfonyl]amino]-2-naphthalenedisulfonato(5-)]]-, potassium sodium	90295-35-5	Intentional addition / 1,000ppm	chemical products
18052	Cuprate(3-), [N,N,N'-tris[2-(sulfothio)ethyl]-29H,31H-phthalocyaninetrisulfonamidato(5-)-N29,N30,N31,N32]-, sodium	90295-36-6	Intentional addition / 1,000ppm	chemical products
18053	2-Heptene, 7-bromo-	90321-84-9	1,000ppm	chemical products
18054	Hydrogen chlorotrioxochromate(1-), compound with N,N-dimethylpyridin-4-amine (1:1)	90341-42-7	Contains (regardless of intentional or impurities)	chemical products
18055	Cuprate(4-), [4-amino-6-[[5-[[2-(diethylamino)ethyl]sulfonyl]-2-hydroxyphenyl]azo]-3-[[2-(5-disulfofenyl)azo]-5-hydroxy-2,7-naphthalenedisulfonato(6-)]]-, sodium	90341-57-4	Intentional addition / 1,000ppm	chemical products
18056	Cuprate(4-), [7-amino-3-[[2,8-dihydroxy-3,6-disulfo-1-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)]]-, lithium sodium	90341-58-5	Intentional addition / 1,000ppm	chemical products
18057	Cuprate(4-), [4-amino-5-hydroxy-6-[[8-hydroxy-7-[[2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-6-sulfo-2-naphthalenyl]azo]-1,3-naphthalenedisulfonato(6-)]]-, potassium sodium	90341-59-6	Intentional addition / 1,000ppm	chemical products
18058	Cuprate(4-), [mu-[[3,3'-[azobis[[2-hydroxy-4,1-phenylene]azo]]bis[4-hydroxy-6-[[3-sulfofenyl]amino]-2-naphthalenedisulfonato]](8-)]]]di-, ammonium sodium, compounds with diethanolamine and ethanolamine	90341-60-9	Intentional addition / 1,000ppm	chemical products
18059	Cuprate(4-), [mu-[[3,3'-[azobis[[2-hydroxy-4,1-phenylene]azo]]bis[4-hydroxy-6-[[3-sulfofenyl]amino]-2-naphthalenedisulfonato]](8-)]]]di-, ammonium sodium, compounds with diethanolamine and ethanolamine	90341-61-0	Intentional addition / 1,000ppm	chemical products
18060	Cuprate(4-), [mu-[[4,4'-[azobis[[2-hydroxy-4,1-phenylene]azo]]bis[8-hydroxy-6-sulfo-7,2-naphthalenediylimino]]bis[benzoato]](8-)]]]di-, potassium sodium	90341-62-1	Intentional addition / 1,000ppm	chemical products
18061	Cuprate(4-), [7-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-3-[[2,8-dihydroxy-4,6-disulfo-1-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)]]-, lithium sodium	90341-63-2	Intentional addition / 1,000ppm	chemical products
18062	Cuprate(4-), [7-[[5-chloro-2-fluoro-6-methyl-4-pyrimidinyl]amino]-4-hydroxy-3-[[2-hydroxy-4,6-disulfo-1-naphthalenyl]azo]-1,5-naphthalenedisulfonato(6-)]]-, lithium potassium sodium	90341-64-3	Intentional addition / 1,000ppm	chemical products
18063	Cuprate(4-), [4-[[4-chloro-6-[[3-sulfofenyl]amino]-1,3,5-triazin-2-yl]amino]-5-hydroxy-6-[[2-hydroxy-4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-1,7-naphthalenedisulfonato(6-)]]-, sodium	90341-65-4	Intentional addition / 1,000ppm	chemical products
18064	Cuprate(4-), [mu-[[7,7'-[[6-chloro-1,3,5-triazine-2-diy]dimino]]bis[4-hydroxy-3-[[2-hydroxy-5-sulfofenyl]azo]-2-naphthalenedisulfonato]](8-)]]]di-, sodium	90341-66-5	Intentional addition / 1,000ppm	chemical products
18065	Cuprate(4-), [2-[[[4,5-dihydro-1-[[4-[[3-hydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo]-7-sulfo-1-naphthalenyl]azo]phenyl]-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(6-)]]-, potassium sodium	90341-67-6	Intentional addition / 1,000ppm	chemical products
18066	Cuprate(4-), [mu-[[6,6'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[4-amino-5-hydroxy-1,3-naphthalenedisulfonato]](8-)]]]di-, potassium sodium	90341-68-7	Intentional addition / 1,000ppm	chemical products
18067	Cuprate(4-), [mu-[[4,4'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[3-hydroxy-2,7-naphthalenedisulfonato]](8-)]]]di-, ammonium sodium	90341-69-8	Intentional addition / 1,000ppm	chemical products
18068	Cuprate(4-), [mu-[[7,7'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[8-hydroxy-1,6-naphthalenedisulfonato]](8-)]]]di-, sodium	90341-70-1	Intentional addition / 1,000ppm	chemical products
18069	Cuprate(4-), [2-[[[2-hydroxy-3-sulfo-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]phenylmethyl]azo]-4-sulfobenzoato(6-)]]-, sodium	90341-71-2	Intentional addition / 1,000ppm	chemical products
18070	Cuprate(4-), [2-[[[2-hydroxy-3-sulfo-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]phenylmethyl]azo]-5-sulfobenzoato(6-)]]-, sodium	90341-72-3	Intentional addition / 1,000ppm	chemical products
18071	Cuprate(6-), [mu-[[3,3'-[carbonyldiimino]]bis[8-hydroxy-7-[[1-hydroxy-4-sulfo-2-naphthalenyl]azo]-1,5-naphthalenedisulfonato]](10-)]]]di-, ammonium sodium	90341-73-4	Intentional addition / 1,000ppm	chemical products
18072	Cuprate(6-), [9-[[3-hydroxy-4-[[2-hydroxy-3,6-disulfo-1-naphthalenyl]azo]-7-sulfo-1-naphthalenyl]azo]-7-(6-sulfo-2H-naphth[1,2-d]iazol-2-yl)-1,5-naphthalenedisulfonato(8-)]]-, sodium	90341-74-5	Intentional addition / 1,000ppm	chemical products
18073	Cuprate(8-), [mu-[[3,3'-[carbonyldiimino]]bis[7-[[2,8-dihydroxy-3,6-disulfo-1-naphthalenyl]azo]-8-hydroxy-1,5-naphthalenedisulfonato]](12-)]]]di-, lithium sodium	90341-75-6	Intentional addition / 1,000ppm	chemical products
18074	Decanoic acid, branched, cadmium salts	90342-19-1	Contains (regardless of intentional or impurities)	chemical products
18075	tert-Decanoic acid, cobalt(2+) salt, basic	90342-30-6	Intentional addition / 1%	chemical products
18076	N-[4-Cyano-3-(trifluoromethyl)phenyl]-2-methyloxirane-2-carboxamide	90357-51-0	Contains (regardless of intentional or impurities)	chemical products
18077	Formaldehyde, reaction products with piperazine, epichlorohydrin-quinartzened	90387-50-1	Contains (regardless of intentional or impurities)	chemical products
18078	Formaldehyde, reaction products with 1-propanol zirconium(4+) salt	90387-53-4	Contains (regardless of intentional or impurities)	chemical products
18079	D-Glucitol, reaction products with borax (B4Na2O7.10H2O)	90387-70-5	1%	chemical products
18080	Pentane, 1-bromo-3-methyl-, (R)-	90410-57-4	1,000ppm	chemical products
18081	Hexanoic acid, 2-ethyl-, cadmium salt, basic	90411-62-4	Contains (regardless of intentional or impurities)	chemical products
18082	Indium, acetylacetonate 6-methyl-2,4-heptanedione complexes	90412-06-9	1%	chemical products
18083	Iron, diazotized 4-aminobenzenesulfonic acid-diazotized 2-amino-6-chloro-4-nitrophenol-resorcinol coupling products copper complexes, sodium salts	90412-14-9	Intentional addition / 1,000ppm	chemical products
18084	Iron, isooctanoate naphthenate complexes	90412-19-4	1%	chemical products
18085	Isononanoic acid, reaction products with boron oxide (B2O3) and diethanolamine	90431-23-5	1%	chemical products
18086	Manganese, borate C8-10-branched carboxylate complexes	90431-60-0	Contains (regardless of intentional or impurities)	chemical products
18087	Manganese, borate naphthenate complexes	90431-61-1	Contains (regardless of intentional or impurities)	chemical products
18088	Manganese, C5-23 branched carboxylate octanoate complexes	90431-62-2	Contains (regardless of intentional or impurities)	chemical products
18089	Manganese, 2-ethylhexanoate isooctanoate complexes	90431-63-3	Contains (regardless of intentional or impurities)	chemical products
18090	Manganese, acetylacetonate 6-methyl-2,4-heptanedione complexes	90431-64-4	Contains (regardless of intentional or impurities)	chemical products
18091	Molybdenum, citrate oxo cobalt complexes	90431-89-3	Intentional addition / 1,000ppm	chemical products
18092	Molybdenum, citrate oxo complexes	90431-90-6	1,000ppm	chemical products
18093	Molybdenum, acetylacetonate 6-methyl-2,4-heptanedione complexes	90431-91-7	1,000ppm	chemical products
18094	1-(Bromomethyl)-2-methoxy-4-nitrobenzene	90434-16-5	1%	chemical products
18095	Dichloro-1,1,2-trifluoroethane	90454-18-5	Intentional addition / 1,000ppm	chemical products
18096	Nickel, acetate carbonate C8-10-branched fatty acids C9-11-neofatty acids complexes	90459-30-6	Contains (regardless of intentional or impurities)	chemical products
18097	Nickel, borate C8-10-branched carboxylate complexes	90459-31-7	Contains (regardless of intentional or impurities)	chemical products
18098	Nickel, C5-23 branched carboxylate octanoate complexes	90459-32-8	Contains (regardless of intentional or impurities)	chemical products
18099	Nickel, isooctanoate naphthenate complexes	90459-33-9	Contains (regardless of intentional or impurities)	chemical products
18100	Nickel, acetylacetonate 6-methyl-2,4-heptanedione complexes	90459-34-0	Contains (regardless of intentional or impurities)	chemical products
18101	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]phenyl]amino]sulfonyl sulfo derivatives, sodium salts	90459-35-1	Contains (regardless of intentional or impurities)	chemical products
18102	Nickelate(4-), [bis[[[3-[[4,5-dihydro-3-methyl-5-oxo-1-[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]-1H-pyrazol-4-yl]azo]phenyl]amino]sulfonyl]-29H,31H-phthalocyaninedisulfonato(6-)-N29,N30,N31,N32]-, sodium	90459-36-2	Contains (regardless of intentional or impurities)	chemical products
18103	Octanoic acid, pentadecafluoro-, branched	90480-55-0	1,000ppm	chemical products
18104	Phenol, sulfonated, chromium salts	90480-93-6	1,000ppm	chemical products
18105	(3R)-Methyloxy-1-[N-(4-nitrobenzyloxy carbonyl)acetimidoyl]pyrrolidine	90505-34-3	Contains (regardless of intentional or impurities)	chemical products
18106	Phosphorodithioic acid, mixed C10-bis(hexyl and methylcyclohexyl and octyl) esters, barium salts	90507-80-5	Intentional addition / 1,000ppm	chemical products
18107	1,3-Propanediol, 2-amino-2-ethyl-, reaction products with tributyl(pentyl)oxy/stannane	90529-64-9	Contains (regardless of intentional or impurities)	chemical products
18108	Propanoic acid, cadmium salt, basic	90529-78-5	Contains (regardless of intentional or impurities)	chemical products
18109	2-Propanol, reaction products with boron trifluoride and 5-ethylidenebicyclo[2.2.1]hept-2-ene	90530-04-4	Contains (regardless of intentional or impurities)	chemical products
18110	Azulenium, 1-[[4-(dimethylamino)phenyl]methylene]-1,7-dihydro-3,8-dimethyl-5-(1-methylethyl)-, perchlorate	90550-73-5	1,000ppm	chemical products
18111	Azulenium, 1-[3-[4-(dimethylamino)phenyl]ethyl]-2-propenyldiene]-1,7-dihydro-3,8-dimethyl-5-(1-methylethyl)-, perchlorate	90550-85-9	1,000ppm	chemical products
18112	Rhodium, (isooctylthio)acetate complexes	90552-47-9	1%	chemical products
18113	Rhodium, 6-methyl-2,4-heptanedione 2,4-pentanedione complexes	90552-48-0	1%	chemical products
18114	Stannane, tributyl-, mono[C1-12-alkylsulfonyloxy] derivatives	90552-67-3	Contains (regardless of intentional or impurities)	chemical products
18115	Stannane, tributyl-, mono[C3-23-branched acyloxy] derivatives	90552-68-4	Contains (regardless of intentional or impurities)	chemical products
18116	Stannane, triphenyl-, mono[C9-11 neofatty acyloxy] derivatives	90552-69-5	Contains (regardless of intentional or impurities)	chemical products
18117	3-Ethoxyphenylboronic acid	90555-66-1	1%	chemical products
18118	Tin, benzoate naphthenate rosin sodium complexes	90583-80-5	Contains (regardless of intentional or impurities)	chemical products
18119	Titanium, oxalate ammonium potassium complexes	90583-84-9	Intentional addition / 1,000ppm	chemical products
18120	1-Hexene, 5-bromo-5-methyl-	90601-72-2	1,000ppm	chemical products
18121	Vanadium, acetylacetonate 6-methyl-2,4-heptanedione oxo complexes	90604-60-7	Intentional addition / 1%	chemical products
18122	Vanadium, acetylacetonate 6-methyl-2,4-heptanedione complexes	90604-62-9	Intentional addition / 1%	chemical products
18123	Zirconium, acetate chloro montan-wax fatty acids oxo complexes	90604-73-2	Contains (regardless of intentional or impurities)	chemical products
18124	Zirconium, acetate montan-wax fatty acids oxo complexes	90604-74-3	Contains (regardless of intentional or impurities)	chemical products
18125	Zirconium, acrylate propyl alcohol complexes, reaction products with formaldehyde	90604-75-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
18126	Zirconium, 2-butanol 2-methyl-2,4-pentanediol propyl alcohol aluminum complexes	90604-76-5	Contains (regardless of intentional or impurities)	chemical products
18127	Zirconium, 2-(2-butoxyethoxy)ethanol propyl alcohol complexes	90604-77-6	Contains (regardless of intentional or impurities)	chemical products
18128	Zirconium, carbonate hydroxy methacrylate oxo complexes	90604-78-7	Contains (regardless of intentional or impurities)	chemical products
18129	Zirconium, C8-10-branched fatty acids C9-11-neofatty acids naphthenate complexes	90604-79-8	Contains (regardless of intentional or impurities)	chemical products
18130	Zirconium, chloro glycine hydroxy aluminum complexes	90604-80-1	Contains (regardless of intentional or impurities)	chemical products
18131	C.I. Pigment Yellow 35:1	90604-89-0	Contains (regardless of intentional or impurities)	chemical products
18132	Cadmium lithopone yellow	90604-90-3	Contains (regardless of intentional or impurities)	chemical products
18133	Erbium nonoxide trivanadium	90605-20-2	Intentional addition / 1%	chemical products
18134	Alkanes, C12-26-branched and linear	90622-53-0	Contains (regardless of intentional or impurities)	chemical products
18135	Alkanes, C1-4, C3-rich	90622-55-2	Contains (regardless of intentional or impurities)	chemical products
18136	Alkyl iodides, C8-18, perfluoro	90622-71-2	1,000ppm	chemical products
18137	Creosote oil, acenaphthene fraction	90640-84-9	Contains (regardless of intentional or impurities)	chemical products
18138	Creosote oil, acenaphthene fraction, acenaphthene-free	90640-85-0	Contains (regardless of intentional or impurities)	chemical products
18139	Distillates, coal tar, heavy oils	90640-86-1	Contains (regardless of intentional or impurities)	chemical products
18140	Distillates (coal tar), light oils, acid extracts	90640-87-2	Contains (regardless of intentional or impurities)	chemical products
18141	Distillates (coal tar), light oils, alkaline extracts	90640-88-3	Contains (regardless of intentional or impurities)	chemical products
18142	Distillates (coal tar), naphthalene oils, alkaline extracts	90640-89-4	Contains (regardless of intentional or impurities)	chemical products
18143	Distillates (coal tar), naphthalene oils, naphthalene-free, alkaline extracts	90640-90-7	Contains (regardless of intentional or impurities)	chemical products
18144	Distillates (petroleum), complex dewaxed heavy paraffinic	90640-91-8	Contains (regardless of intentional or impurities)	chemical products
18145	Distillates (petroleum), complex dewaxed light paraffinic	90640-92-9	Contains (regardless of intentional or impurities)	chemical products
18146	Distillates (petroleum), highly refined middle	90640-93-0	Contains (regardless of intentional or impurities)	chemical products
18147	Distillates (petroleum), solvent dewaxed heavy paraffinic, clay-treated	90640-94-1	Contains (regardless of intentional or impurities)	chemical products
18148	Hydrocarbons, C20-50, solvent dewaxed heavy paraffinic, hydrotreated	90640-95-2	Contains (regardless of intentional or impurities)	chemical products
18149	Distillates (petroleum), solvent dewaxed light paraffinic, clay-treated	90640-96-3	Contains (regardless of intentional or impurities)	chemical products
18150	Distillates (petroleum), solvent dewaxed light paraffinic, hydrotreated	90640-97-4	Contains (regardless of intentional or impurities)	chemical products
18151	Extract oils (coal), light oil	90640-99-6	Contains (regardless of intentional or impurities)	chemical products
18152	Extract oils (coal), naphthalene oils (The aqueous extract produced by an acidic wash of alkali-washed naphthalene oil. Composed primarily of acid salts of various aromatic nitrogen bases including pyridine, quinoline and their alkyl derivatives.)	90641-00-2	Contains (regardless of intentional or impurities)	chemical products
18153	Extract residues (coal), light oil alkaline, acid extract	90641-01-3	Contains (regardless of intentional or impurities)	chemical products
18154	Extract residues (coal), light oil alkaline, distillation overheads	90641-02-4	Contains (regardless of intentional or impurities)	chemical products
18155	Extract residues, coal, light oil alkaline, indene naphtha fraction	90641-03-5	Contains (regardless of intentional or impurities)	chemical products
18156	Extract residues (coal), naphthalene oil alkaline, distillation overheads	90641-04-6	Contains (regardless of intentional or impurities)	chemical products
18157	Extract residues (coal), naphthalene oil alkaline, distillation residues	90641-05-7	Contains (regardless of intentional or impurities)	chemical products
18158	Extract residues (coal), tar oil alkaline, carbonated, limed	90641-06-8	Contains (regardless of intentional or impurities)	chemical products
18159	Extracts (petroleum), heavy naphthenic distillate solvent, hydrotreated	90641-07-9	Contains (regardless of intentional or impurities)	chemical products
18160	Extracts (petroleum), heavy paraffinic distillate solvent, hydrotreated	90641-08-0	Contains (regardless of intentional or impurities)	chemical products
18161	Extracts (petroleum), light paraffinic distillate solvent, hydrotreated	90641-09-1	Contains (regardless of intentional or impurities)	chemical products
18162	Light oil (coal), semi-coking process	90641-11-5	Contains (regardless of intentional or impurities)	chemical products
18163	Naphtha (coal), distillation residues	90641-12-6	Contains (regardless of intentional or impurities)	chemical products
18164	Petrolatum (petroleum), oxidized, ester with propylene glycol, barium salt	90669-53-7	Intentional addition / 1,000ppm	chemical products
18165	Petrolatum (petroleum), oxidized, 2-hydroxyethyl ester, barium salt	90669-55-9	Intentional addition / 1,000ppm	chemical products
18166	Pitch, coal tar, low-temperature	90669-57-1	Contains (regardless of intentional or impurities)	chemical products
18167	Pitch, coal tar, low-temperature, heat-treated	90669-58-2	Contains (regardless of intentional or impurities)	chemical products
18168	Pitch, coal tar, low-temperature, oxidized	90669-59-3	Contains (regardless of intentional or impurities)	chemical products
18169	Residual oils (petroleum), hydrotreated solvent dewaxed	90669-74-2	Contains (regardless of intentional or impurities)	chemical products
18170	Residues (petroleum), steam-cracked, distillates	90669-75-3	Contains (regardless of intentional or impurities)	chemical products
18171	Residues (petroleum), vacuum, light	90669-76-4	Contains (regardless of intentional or impurities)	chemical products
18172	Slack wax (petroleum), acid-treated	90669-77-5	Contains (regardless of intentional or impurities)	chemical products
18173	Slack wax (petroleum), clay-treated	90669-78-6	Contains (regardless of intentional or impurities)	chemical products
18174	Chromate(4-), [7-[(2,3-dibromo-1-oxopropyl)amino]-4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenesulfonato(3-)]][4-[6-[(2,3-dibromo-1-oxopropyl)amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, tetrasodium	90677-69-3	Contains (regardless of intentional or impurities)	chemical products
18175	Disodium [3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]][N-[(2-hydroxyphenyl)imino]ethylene]dicinato(2-)-N,O,chromate(2-)	90677-70-6	Contains (regardless of intentional or impurities)	chemical products
18176	Cuprate(4-), [2-[[[1-4-[2-4-[[4-[[3-carboxy-4-hydroxyphenyl)azo]phenyl]amino]-6-(phenylamino)-1,3,5-triazin-2-yl]amino]-2-sulfo]phenyl]ethyl]-3-sulfo]phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-5-sulfobenzato(6-)]-, tetrasodium	90677-78-4	Intentional addition / 1,000ppm	chemical products
18177	C.I. Acid Red 119:1	90880-75-4	1,000ppm	chemical products
18178	Molybdenum, bis[bis(2-ethylhexyl)carbamodithioato-kappa S,kappa S']dioxodi-mu-thioxodi-	90901-24-9	1,000ppm	chemical products
18179	Molybdenum, bis[bis(2-ethylhexyl)carbamodithioato-kappa S,kappa S']di-mu-thioxodithioxodi-	90901-25-0	1,000ppm	chemical products
18180	Hydroxylamine, benzoate (salt)	90901-32-9	Intentional addition / 1%	chemical products
18181	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, compound with cellulose carboxymethyl ether	90937-10-3	Contains (regardless of intentional or impurities)	chemical products
18182	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, compound with cellulose carboxymethyl 2-hydroxypropyl ether	90937-12-5	Contains (regardless of intentional or impurities)	chemical products
18183	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, compound with cellulose dihydrogen phosphate	90937-13-6	Contains (regardless of intentional or impurities)	chemical products
18184	Decane, 1,5,6,6,10-hexachloro	90943-97-8	1,000ppm	chemical products
18185	2-Propanoic acid, homopolymer, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine	90960-67-1	Contains (regardless of intentional or impurities)	chemical products
18186	Aromatic hydrocarbons, C8	90989-38-1	Contains (regardless of intentional or impurities)	chemical products
18187	Aromatic hydrocarbons, C8-10	90989-39-2	Contains (regardless of intentional or impurities)	chemical products
18188	Aromatic hydrocarbons, C6-10, C8-rich	90989-41-6	Contains (regardless of intentional or impurities)	chemical products
18189	Aromatic hydrocarbons, C7-8, dealkylation products, distillation residues	90989-42-7	Contains (regardless of intentional or impurities)	chemical products
18190	Phenol, 4-(2,4-dimethylheptyl)-	91000-35-0	Intentional addition / 1%	chemical products
18191	Fatty acids, C8-9, barium salts	91002-05-0	Intentional addition / 1,000ppm	chemical products
18192	Fatty acids, C8-10, barium salts	91002-06-1	Intentional addition / 1,000ppm	chemical products
18193	Fatty acids, C16-18, barium salts	91002-07-2	Intentional addition / 1,000ppm	chemical products
18194	Fatty acids, C6-19-branched, chromium salts	91002-17-4	1,000ppm	chemical products
18195	Fatty acids, C8-9, cobalt salts	91031-16-2	Intentional addition / 1%	chemical products
18196	Fatty acids, C8-9, manganese salts	91031-64-0	Contains (regardless of intentional or impurities)	chemical products
18197	Fatty acids, C9-13-neo-, copper salts	91031-79-7	Intentional addition / 1,000ppm	chemical products
18198	Fatty acids, C9-13-neo-, manganese salts	91031-80-0	Contains (regardless of intentional or impurities)	chemical products
18199	Fatty acids, C8-9-branched, zirconium salts	91051-02-4	Contains (regardless of intentional or impurities)	chemical products
18200	Fatty acids, peanut-oil, barium salts	91051-36-4	Intentional addition / 1,000ppm	chemical products
18201	Flue dust, antimony-manufacturing	91051-98-8	Contains (regardless of intentional or impurities)	chemical products
18202	Humic acids, chromium salts	91052-93-6	1,000ppm	chemical products
18203	Leach residues, cadmium cake	91053-44-0	Contains (regardless of intentional or impurities)	chemical products
18204	Leach residues, cobalt ore	91053-45-1	Contains (regardless of intentional or impurities)	chemical products
18205	Leach residues, zinc ore-calcine, cadmium-copper precipitated	91053-46-2	Contains (regardless of intentional or impurities)	chemical products
18206	Leach residues, zinc ore-calcine, iron-containing	91053-47-3	Contains (regardless of intentional or impurities)	chemical products
18207	Leach residues, zinc ore, germanium-containing - Insoluble substance obtained in the treatment of blends in sulfuric acid after leaching. Also contains arsenic, iron oxide, and various heavy metals.	91053-48-4	Contains (regardless of intentional or impurities)	chemical products
18208	Naphthenic acids, indium salts	91078-80-7	1%	chemical products
18209	Naphthenic acids, rhodium(3+) salts	91078-88-5	Contains (regardless of intentional or impurities)	chemical products
18210	Phenols, C9-11	91079-47-9	Contains (regardless of intentional or impurities)	chemical products
18211	Quaternary ammonium compounds, benzyl-C8-18-alkyldimethyl, bromides	91080-29-4	1,000ppm	chemical products
18212	Resin, reaction products with formaldehyde	91081-53-7	1,000ppm	chemical products
18213	Slimes and sludges, copper pickling wastewater treatment	91081-71-9	Intentional addition / 1,000ppm	chemical products
18214	Slimes and sludges, copper manufacture, sulfuric acid treatment	91081-72-0	Intentional addition / 1,000ppm	chemical products
18215	Slimes and Sludges, copper manufacture, sulfuric acid treatment neutralized	91081-73-1	Intentional addition / 1,000ppm	chemical products
18216	Slimes and sludges, galvanizing, chromium-containing - By-product from the galvanizing industry containing cao, nio, Cr2O3, FeO and CuO.	91081-74-2	Intentional addition / 1,000ppm	chemical products
18217	Slimes and sludges, galvanizing, tungsten-containing - By-product from the galvanizing industry consisting of Al2O3, WO3, cobalt, iron and silicon.	91081-75-3	Intentional addition / 1%	chemical products
18218	Spinels, aluminum iron manganese brown	91081-90-2	Contains (regardless of intentional or impurities)	chemical products
18219	Spinels, iron manganese brown	91081-91-3	Contains (regardless of intentional or impurities)	chemical products
18220	Sulfonic acids, petroleum, copper salts	91082-26-7	Intentional addition / 1,000ppm	chemical products
18221	Tar, coal, storage residues	91082-50-7	Contains (regardless of intentional or impurities)	chemical products
18222	Tar bases, coal, lutidine fraction	91082-52-9	Contains (regardless of intentional or impurities)	chemical products
18223	Tar bases, coal, toluidine fraction	91082-53-0	Contains (regardless of intentional or impurities)	chemical products
18224	Turpentine, Venice, sulfurized, reaction products with hydrogen tetrachloroaurate(1-), sulfurized turpentine oil and mercurous nitrate, mixed with mercurous oxide	91082-69-8	Contains (regardless of intentional or impurities)	chemical products
18225	Waste solids, chromium-nickel steel manufacture - By-product from refined steel manufacture containing C, Cr, Fe and Ni (as Cr-Ni-grindings) and Cr2O3, FeO, MnO, NiO and SiO2 (as burned slag).	91082-81-4	Contains (regardless of intentional or impurities)	chemical products
18226	Waste solids, nickel-manufacture - By-product from nickel production containing NiO, SiO2, CuO, and MnO and sulfur.	91082-84-7	Contains (regardless of intentional or impurities)	chemical products
18227	Waste solids, cast iron scrap melting - Granular substance resulting from the melting of cast iron scrap, composed primarily of iron with varying amounts of carbon, manganese, phosphorus, silicon and sulfur.	91082-85-8	Contains (regardless of intentional or impurities)	chemical products
18228	Waste solids, steel scrap melting - Granular substance resulting from the melting of steel scrap. Consists primarily of iron with varying amounts of carbon, manganese, phosphorus, silicon and sulfur.	91082-86-9	Contains (regardless of intentional or impurities)	chemical products
18229	Wastewater, coke oven gas desulfurization	91082-87-0	Intentional addition / 1%	chemical products
18230	5,5,6,6-Tetrachlorodecane	91087-09-1	1,000ppm	chemical products
18231	Cellulose, 4-carboxybutyl ether, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine	91098-28-1	Contains (regardless of intentional or impurities)	chemical products
18232	2-Butoxyphenylboronic acid	91129-69-0	1%	chemical products
18233	Pentasodium bis[4-[[6-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-2-naphthyl-3-sulpho]azo]-3-hydroxy-7-nitronaphthalene-1-sulphonato(4-)]cobaltate	91144-26-2	Contains (regardless of intentional or impurities)	chemical products
18234	Chromate(3-), [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]][4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-6-[[4-methylphenyl)sulfonyl]amino]-2-naphthalenesulfonato(3-)]-, trisodium	91144-27-3	Contains (regardless of intentional or impurities)	chemical products
18235	Chromate(3-), [4-hydroxy-3-[(2-hydroxy-3,5-dinitrophenyl)azo]-6-[[4-methylphenyl)sulfonyl]amino]-2-naphthalenesulfonato(3-)]][3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-, trisodium	91144-28-4	Contains (regardless of intentional or impurities)	chemical products
18236	Ferrate(1-), [3,12-bis(carboxymethyl)-6,9-dioxo-3,12-diazatetradecanedioato(4-)-N3,N12,O1,O3,O12,O14]-hydrogen, (OC-6-21)	91154-97-1	1%	chemical products
18237	Borane, dibromoethoxy-	91158-38-2	1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
18238	Chromate(5-), bis[4-[[6-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, pentasodium	91159-19-2	Contains (regardless of intentional or impurities)	chemical products
18239	Alginic acid, phosphate, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine	91198-78-6	Contains (regardless of intentional or impurities)	chemical products
18240	N-Ethyl-N-isopropyl-1,4-phenylenediamine	91215-79-1	Contains (regardless of intentional or impurities)	chemical products
18241	Nickelate(1-), tris(cyano-), potassium	91235-82-4	Contains (regardless of intentional or impurities)	chemical products
18242	Octanoic acid, 7,7-dimethyl-, copper(2+) salt	91384-56-6	Intentional addition / 1,000ppm	chemical products
18243	N-(4-Bromo-1-naphthyl)acetamide	91394-66-0	Contains (regardless of intentional or impurities)	chemical products
18244	Poly(iminocarbonimidoyl)iminocarbonimidoylmino-1,6-hexanedyl-, alpha-(6-aminoheptyl)-omega-[[[2-azenoamino]iminomethyl]amino]-, hydrochloride	91403-50-8	1,000ppm	chemical products
18245	2-Butenoic acid, 4,4'-[[[diethylstannyl]bis(oxo)]bis[4-oxo-, diisononyl ester, (Z,Z)]	91422-01-4	Contains (regardless of intentional or impurities)	chemical products
18246	Cyhalothrin, lambda	91465-08-6	Contains (regardless of intentional or impurities)	chemical products
18247	Phosphoric acid, vanadium(5+) salt (5:1)	91481-83-5	Intentional addition / 1%	chemical products
18248	O-(1-Chloroethyl) S-methyl carbonothioate	91507-87-4	Contains (regardless of intentional or impurities)	chemical products
18249	2-(2,3-Epoxypropyl)-6-methoxyphenyl acetate	91520-02-4	Contains (regardless of intentional or impurities)	chemical products
18250	Methyl chlorate	91589-75-2	Intentional addition	chemical products
18251	3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,13,14,14,15,16,16,16-Octacosylfluoro-15-(trifluoromethyl)hexadecyl acrylate	91615-22-4	1,000ppm	chemical products
18252	Phosphoric acid, mono-C4-6-alkyl esters, barium salts (1:1)	91648-03-2	Intentional addition / 1,000ppm	chemical products
18253	Tin alloy, dross	91648-71-4	1,000ppm	chemical products
18254	Bis[bis(2-methylpropyl)carbamothioato-S]copper(I)	91670-37-0	Intentional addition / 1,000ppm	chemical products
18255	Iron, 2-ethylhexanoate naphthenate complexes	91671-77-1	1%	chemical products
18256	Iron, isodecanoate naphthenate complexes	91671-78-2	1%	chemical products
18257	Iron, isononanoate naphthenate complexes	91671-79-3	1%	chemical products
18258	Iron, naphthenate neodecanoate complexes	91671-80-6	1%	chemical products
18259	Chromate(1-), aqua[4-[[4-[[3,5-dichloro-5-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)](2,4-pentanedionato-O,O)-, ammonium sodium	91672-56-9	Contains (regardless of intentional or impurities)	chemical products
18260	Chromate(1-), aqua[4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)](2,4-pentanedionato-O,O)-, ammonium sodium	91672-57-0	Contains (regardless of intentional or impurities)	chemical products
18261	Chromate(1-), aqua[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)](2,4-pentanedionato-O,O)-, ammonium sodium	91672-58-1	Contains (regardless of intentional or impurities)	chemical products
18262	Chromate(1-), bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 3-(C8-18-alkylamino)butanoic acid	91672-59-2	Contains (regardless of intentional or impurities)	chemical products
18263	Chromate(2-), [4-[[4-[[3,5-dihydro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]hydroxy(2,4-pentanedionato-O,O)-, ammonium sodium	91672-60-5	Contains (regardless of intentional or impurities)	chemical products
18264	Chromate(2-), [4-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]hydroxy(2,4-pentanedionato-O,O)-, ammonium sodium	91672-61-6	Contains (regardless of intentional or impurities)	chemical products
18265	Chromate(2-), [3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]hydroxy(2,4-pentanedionato-O,O)-, ammonium sodium	91672-62-7	Contains (regardless of intentional or impurities)	chemical products
18266	Chromate(3-), bis[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]-, potassium sodium	91672-63-8	Contains (regardless of intentional or impurities)	chemical products
18267	Chromate(5-), bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)]-, sodium	91672-64-9	Contains (regardless of intentional or impurities)	chemical products
18268	Chromium, 2-carboxybenzenediazonium-2,5-dichloro-4-(4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl)benzenesulfonic acid-4-(4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl)benzenesulfonic acid coupling products complexes, compounds with N,N'-bis(phenyl and o-tolyl and xyl)guanidine	91672-65-0	1,000ppm	chemical products
18269	Chromium, 2-carboxybenzenediazonium-2,5-dichloro-4-(4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl)benzenesulfonic acid-4-(4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl)benzenesulfonic acid coupling products complexes, compounds with N-butyl-1-butanamine and N-cyclohexylcyclohexanamine	91672-66-1	1,000ppm	chemical products
18270	Chromium, 2-carboxybenzenediazonium-2,5-dichloro-4-(4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl)benzenesulfonic acid-4-(4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl)benzenesulfonic acid coupling products sodium complexes	91672-67-2	1,000ppm	chemical products
18271	Chromium, 1-[[5-chloro-2-hydroxy-4-nitrophenyl]azo]-2-naphthalenol-3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonate complexes	91672-68-3	1,000ppm	chemical products
18272	Chromium, 2-hydroxy-3,5-dinitrobenzenediazonium-4(or 5)-hydroxy-1-naphthalenesulfonic acid coupling products 3-hydroxy-4-[[1-hydroxy-2-naphthalenyl]azo]-1-naphthalenesulfonate complexes, compounds with N-butyl-1-butanamine and N-cyclohexylcyclohexanamine	91672-70-7	1,000ppm	chemical products
18273	Chromium, 2-hydroxy-3,5-dinitrobenzenediazonium-4(or 5)-hydroxy-1-naphthalenesulfonic acid coupling products 3-hydroxy-4-[[1-hydroxy-2-naphthalenyl]azo]-1-naphthalenesulfonate sodium complex	91672-71-8	1,000ppm	chemical products
18274	Cobalt, 5-bis[3-(C8-10-alkyloxy)-2-hydroxypropyl]amino]-2-[[2,5-dimethoxy-4-(phenylazo)phenyl]azo]phenol complexes, acetylated, compounds with N-butyl-1-butanamine	91672-72-9	Intentional addition / 1%	chemical products
18275	Cobalt, 5-bis[3-(C8-10-alkyloxy)-2-hydroxypropyl]amino]-2-[[2-methoxy-5-methyl-4-(phenylazo)phenyl]azo]phenol complexes, acetylated, compounds with N-butyl-1-butanamine	91672-73-0	Intentional addition / 1%	chemical products
18276	Cobalt, 5-bis[mixed 3-butoxy-2-hydroxypropyl and 3-(C8-10-alkyloxy)-2-hydroxypropyl]amino]-2-[[2-methoxy-5-methyl-4-(phenylazo)phenyl]azo]phenol complexes, acetylated, compounds with N-butyl-1-butanamine	91672-74-1	Intentional addition / 1%	chemical products
18277	Cobalt, complexes with 5,6-dihydro-1,4-dithiin-2,3-dicarbonylurea reaction products and N,N-dimethyl-1,3-propanediamine	91672-75-2	Intentional addition / 1%	chemical products
18278	Cobalt, [29H,31H-phthalocyaninato(2-)]N29,N30,N31,N32]-, thiocyanato derivatives	91672-76-3	Intentional addition / 1%	chemical products
18279	Cobalt, [29H,31H-phthalocyaninato(2-)]N29,N30,N31,N32]-, thiocyanato derivatives, reaction products with sodium sulfide (Na2Sx) and sulfur	91672-77-4	Intentional addition / 1%	chemical products
18280	Cobaltate(1-), bis[2-[[4-amino-2-hydroxyphenyl]azo]-4-chlorophenolato(2-)]-, N,N,N',N'-tetrakis[3-(C8-10-alkyloxy)-2-hydroxypropyl] derivatives, hydrogen, compounds with N-butyl-1-butanamine (1:1)	91672-78-5	Intentional addition / 1%	chemical products
18281	Cobaltate(1-), bis[2-[[4-amino-2-hydroxyphenyl]azo]-4-chlorophenolato(2-)]-, N,N,N',N'-tetrakis[mixed 3-butoxy-2-hydroxypropyl and 3-(C8-10-alkyloxy)-2-hydroxypropyl] derivatives, hydrogen, compounds with N-butyl-1-butanamine (1:1)	91672-79-6	Intentional addition / 1%	chemical products
18282	Cobaltate(1-), bis[2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 3-(C8-18-alkylamino)butanoic acid	91672-80-9	Intentional addition / 1%	chemical products
18283	Cobaltate(1-), bis[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, heptyl derivatives, sodium	91672-81-0	Intentional addition / 1%	chemical products
18284	Cobaltate(1-), bis[2-[[2-hydroxy-5-nitrophenyl]azo]-3-oxo-N-phenylbutanamido(2-)]-, hydrogen, compound with 3-(C8-18-alkylamino)butanoic acid	91672-82-1	Intentional addition / 1%	chemical products
18285	Cobaltate(1-), bis[2-[[2-hydroxyphenyl]azo]-3-oxo-N-phenylbutanamido(2-)]-, hydrogen, compound with 3-(C8-18-alkylamino)butanoic acid	91672-83-2	Intentional addition / 1%	chemical products
18286	Cobaltate(5-), bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)]-, sodium	91672-84-3	Intentional addition / 1%	chemical products
18287	Cobaltate(7-), bis[4-hydroxy-5-[[2-hydroxy-1-naphthalenyl]azo]-3-[[2-hydroxy-3-nitro-5-sulfo]phenyl]azo]-2,7-naphthalenedisulfonato(5-)]-, sodium	91672-85-4	Intentional addition / 1%	chemical products
18288	Copper, 3-[[2,4-dihydroxy[[2-hydroxy-5-[[2-sulfo]oxy]ethyl]sulfonyl]phenyl]azo]phenyl]-1,5-naphthalenedisulfonate potassium complexes	91672-86-5	Intentional addition / 1,000ppm	chemical products
18289	Copper, [29H,31H-phthalocyaninato(2-)]N29,N30,N31,N32]-, [[3-(dimethylamino)propyl]amino]sulfonyl sulfo derivatives, formates, compounds with 1-methyl-2-pyrrolidinone	91672-87-6	Intentional addition / 1,000ppm	chemical products
18290	Copper, [29H,31H-phthalocyaninato(2-)]N29,N30,N31,N32]-, thiocyanato derivatives, reaction products with sodium sulfide (Na2Sx) and sulfur	91672-88-7	Intentional addition / 1,000ppm	chemical products
18291	Cuprate(3-), [2-[[6-[[[5-chloro-2-hydroxyphenyl]azo]-5-hydroxy-7-sulfo-2-naphthalenyl]amino]carbonyl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(5-)]-, sodium	91672-89-8	Intentional addition / 1,000ppm	chemical products
18292	Cuprate(4-), [7-[[5-chloro-2-fluoro-6-methyl-4-pyrimidinyl]amino]-3-[[2,8-dihydroxy-4,6-disulfo-1-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)]-, lithium potassium sodium	91672-90-1	Intentional addition / 1,000ppm	chemical products
18293	Cuprate(4-), [7-[[5-chloro-2-fluoro-6-methyl-4-pyrimidinyl]amino]-3-[[2,8-dihydroxy-4,6-disulfo-1-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)]-, potassium sodium	91672-91-2	Intentional addition / 1,000ppm	chemical products
18294	Cuprate(4-), [7-[[6-[[5-chloro-2-fluoro-6-methyl-4-pyrimidinyl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-8-hydroxy-1,3,5-naphthalenetrisulfonato(6-)]-, potassium sodium	91672-92-3	Intentional addition / 1,000ppm	chemical products
18295	Cuprate(4-), [mu-[[2,2'-(1,2-ethenediyl)bis[5-[[3-hydroxy-4-[[2-hydroxy-5-sulfo]phenyl]azo]phenyl]-nno-azoxy]benzenesulfonato]](8-)]dfr-, ammonium sodium	91672-93-4	Intentional addition / 1,000ppm	chemical products
18296	Cuprate(6-), [2-[[[3-[[4-chloro-6-[[4-[[4-chloro-6-[[3-sulfo]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2,5-disulfo]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulfo]phenyl]methyl]azo]-5-sulfo]benzoato(8-)]-, sodium	91672-94-5	Intentional addition / 1,000ppm	chemical products
18297	Glycine, N,N'-2-ethanedithiylbis(N-carboxymethyl)-, tin(2+) salt (1:2)	91679-78-6	1,000ppm	chemical products
18298	Benzenesulfonic acid, 4-C10-14-alkyl derivatives, sodium salts	91696-86-1	1%	chemical products
18299	Benzenesulfonic acid, C14-44-branched alkyl derivatives, barium salts	91696-87-2	Intentional addition / 1,000ppm	chemical products
18300	Benzenesulfonic acid, C14-44-branched and linear alkyl derivatives, barium salts	91696-72-9	Intentional addition / 1,000ppm	chemical products
18301	Boric acid (H3BO3), reaction products with 2-amino-2-methyl-1-propanol	91696-85-6	1%	chemical products
18302	Boric acid (H3BO3), reaction products with diethanolamine, compounds with diethanolamine and ethanolamine	91696-96-7	1%	chemical products
18303	Boric acid (H3BO3), reaction products with morpholine	91696-97-8	1%	chemical products
18304	Chromium, 2-hydroxy-3,5-dinitrobenzenediazonium-4(or 5)-hydroxy-1-naphthalenesulfonic acid coupling products 3-hydroxy-4-[[1-hydroxy-2-naphthalenyl]azo]-1-naphthalenesulfonate complexes, compounds with N,N'-bis(phenyl and o-tolyl and xyl)guanidine	91697-12-0	1,000ppm	chemical products
18305	Extract residues (coal), brown	91697-23-3	Contains (regardless of intentional or impurities)	chemical products
18306	Fatty acids, castor-oil, hydrogenated, barium salts	91697-34-6	Intentional addition / 1,000ppm	chemical products
18307	Fatty acids, castor-oil, hydrogenated, cadmium salts	91697-35-7	Contains (regardless of intentional or impurities)	chemical products
18308	Fatty acids, C6-19-branched, nickel salts	91697-41-5	Contains (regardless of intentional or impurities)	chemical products
18309	Fatty acids, C8-10-branched, zirconium salts, basic	91697-50-6	Contains (regardless of intentional or impurities)	chemical products
18310	1-(4-Bromo-3-nitrophenyl)butane-1-one	91715-78-5	Contains (regardless of intentional or impurities)	chemical products
18311	Resin acids and rosin acids, tall-oil, barium salts	91722-00-8	Intentional addition / 1,000ppm	chemical products
18312	Leach residues, chromite calcine	91722-70-2	1,000ppm	chemical products
18313	Naphthenic acids, iron(2+) salts	91723-00-1	1%	chemical products
18314	Naphthenic acids, zirconium salts, basic	91723-01-2	Contains (regardless of intentional or impurities)	chemical products
18315	Strontium arsenite	91724-16-2	Contains (regardless of intentional or impurities)	chemical products
18316	Amines, C8-18-alkyl, bis[2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)(1:1)	91745-37-8	Contains (regardless of intentional or impurities)	chemical products
18317	Amines, C12-14-tert-alkyl, [29H,31H-phthalocyaninedisulfonato(4-)]N29,N30,N31,N32]cuprate(2-)(2:1)	91745-42-5	Intentional addition / 1,000ppm	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
18318	Amines, C12-14-tert-alkyl, [29H,31H-phthalocyaninetrisulfonato(5-)-N29,N30,N31,N32]cuprate(3-)(3:1)	91745-43-6	Intentional addition / 1,000ppm	chemical products
18319	Balsams, canada, sulfurized, rhodium salts	91745-77-6	1%	chemical products
18320	Balsams, copaiba, sulfurized, rhodium salts	91745-79-8	1%	chemical products
18321	Fatty acids, soya, reaction products with boric acid (H3BO3) and diethanolamine	91769-97-0	1%	chemical products
18322	Fatty acids, tall-oil, reaction products with boric acid (H3BO3) and diethanolamine	91770-03-5	1,000ppm	chemical products
18323	Naphthenic acids, molybdenum salts	91770-33-1	Contains (regardless of intentional or impurities)	chemical products
18324	Residual oils (petroleum), catalytic dewaxed	91770-57-9	Contains (regardless of intentional or impurities)	chemical products
18325	Turpentine, reaction products with 2-ethylhexanoic acid and zirconium chloride (ZrCl4)	91771-29-8	1%	chemical products
18326	Balsams, copaiba, sulfurized, indium salts	91771-79-8	1%	chemical products
18327	Fatty acids, C8-11-branched, reaction products with boric acid (H3BO3) and diethanolamine	91771-80-1	1%	chemical products
18328	Fatty acids, C8-11-branched, reaction products with boric acid (H3BO3) and diisopropanolamine	91771-83-4	1%	chemical products
18329	Fatty acids, coco, reaction products with boric acid (H3BO3) and diethanolamine	91771-84-5	1%	chemical products
18330	Fatty acids, coco, reaction products with boric acid (H3BO3) and diisopropanolamine	91771-85-5	1%	chemical products
18331	Boric acid (H2b4O7), dipotassium salt, reaction products with glycerol	91782-41-1	1%	chemical products
18332	Boric acid (H2b4O7), dipotassium salt, reaction products with tetraethylene glycol	91782-42-2	1%	chemical products
18333	Boric acid (H2b4O7), dipotassium salt, reaction products with triethylene glycol	91782-43-3	1%	chemical products
18334	1,2-Ethanediol, reaction products with boron sodium oxide (B4Na2O7)	91782-44-4	1%	chemical products
18335	Chromium, 2,4-diamino-5-[(2-hydroxy-3,5-dinitrophenyl)azo]benzenesulfonate complexes	91782-58-0	1,000ppm	chemical products
18336	Chromium, 3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonate potassium sodium complexes	91782-59-1	1,000ppm	chemical products
18337	Cobalt, borate 2-ethylhexanoate complexes	91782-60-4	Intentional addition / 1,000ppm	chemical products
18338	Cobalt, borate propionate complexes	91782-61-5	Intentional addition / 1,000ppm	chemical products
18339	Iron, C8-10-branched fatty acids C9-11-neofatty acids naphthenate complexes	91782-87-5	1%	chemical products
18340	Manganese, C8-10-branched fatty acids C9-11-neofatty acids naphthenate complexes	91782-88-6	Contains (regardless of intentional or impurities)	chemical products
18341	Phenol, nonyl-, branched, barium salts	91783-02-7	Intentional addition / 1,000ppm	chemical products
18342	Benzene, C10-12-alkyl derivatives, distillation residues, sulfonated, barium salts	91844-56-3	Intentional addition / 1,000ppm	chemical products
18343	Benzene, C12-14-alkyl derivatives, distillation residues, sulfonated, barium salts	91844-57-4	Intentional addition / 1,000ppm	chemical products
18344	Amines, C12-14-tert-alkyl, bis[4-[(6-chloro-2-hydroxyphenyl)azo]-2-(2-chlorophenyl)-2,4-dihydro-5-methyl-pyrazol-3-onato(2-)]cobaltate(1-)(1:1)	91844-81-4	Intentional addition / 1%	chemical products
18345	Fatty acids, C3-22, nickel salts, basic	91845-72-6	Contains (regardless of intentional or impurities)	chemical products
18346	Butanedioic acid, molybdenum(2+) salt (1:1)	91980-26-6	1,000ppm	chemical products
18347	2-(Bromomethyl)benzeneboronic acid	91983-14-1	1%	chemical products
18348	Chromate(1-), diaqua(2-hydroxybenzoato(2-)-O1,O2)(3-hydroxy-2-naphthalenecarboxylato(2-)-O2,O3)-sodium	91992-99-3	Contains (regardless of intentional or impurities)	chemical products
18349	Anthracene oil, acid extract	91995-14-1	Contains (regardless of intentional or impurities)	chemical products
18350	Anthracene oil, anthracene paste, carbazole fraction	91995-16-3	Contains (regardless of intentional or impurities)	chemical products
18351	Aromatic hydrocarbons, C8, catalytic reforming-derived	91995-18-5	Contains (regardless of intentional or impurities)	chemical products
18352	Aromatic hydrocarbons, C8-9, hydrocarbon resin polymerization by-product	91995-20-9	Contains (regardless of intentional or impurities)	chemical products
18353	Asphaltenes (petroleum)	91995-23-2	Contains (regardless of intentional or impurities)	chemical products
18354	Distillates (petroleum), alkene-alkyne manufacture pyrolysis oil, mixed with high-temperature coal tar, indene fraction	91995-31-2	Contains (regardless of intentional or impurities)	chemical products
18355	Distillates (petroleum), catalytic reformer, heavy aromatic concentrate	91995-34-5	Contains (regardless of intentional or impurities)	chemical products
18356	Distillates (coal), coal tar-residual pyrolysis oils, naphthalene oils	91995-35-6	Contains (regardless of intentional or impurities)	chemical products
18357	Hydrocarbons, C4-6, depentanizer lights, aromatic hydrotreated	91995-38-9	Contains (regardless of intentional or impurities)	chemical products
18358	Distillates (petroleum), dewaxed heavy paraffinic, hydrotreated	91995-39-0	Contains (regardless of intentional or impurities)	chemical products
18359	Distillates (petroleum), dewaxed light paraffinic, hydrotreated	91995-40-3	Contains (regardless of intentional or impurities)	chemical products
18360	Distillates (petroleum), heat-soaked steam-cracked naphtha, C5-rich	91995-41-4	Contains (regardless of intentional or impurities)	chemical products
18361	Distillates (coal tar), heavy oils, pyrene fraction	91995-42-5	Contains (regardless of intentional or impurities)	chemical products
18362	Distillates (petroleum), hydrocracked solvent-refined, dewaxed	91995-45-8	Contains (regardless of intentional or impurities)	chemical products
18363	Distillates (coal tar), naphthalene oils, acid extracts	91995-48-1	Contains (regardless of intentional or impurities)	chemical products
18364	Distillates (coal tar), naphthalene oil crystallization mother liquor	91995-49-2	Contains (regardless of intentional or impurities)	chemical products
18365	Distillates (petroleum), naphtha steam cracking-derived, hydrotreated light aromatic	91995-50-5	Contains (regardless of intentional or impurities)	chemical products
18366	Distillates (coal tar), pitch, heavy oils	91995-51-6	Contains (regardless of intentional or impurities)	chemical products
18367	Distillates (coal tar), pitch, pyrene fraction	91995-52-7	Contains (regardless of intentional or impurities)	chemical products
18368	Distillates (petroleum), naphtha steam cracking-derived, solvent-refined light hydrotreated	91995-53-8	Contains (regardless of intentional or impurities)	chemical products
18369	Distillates (petroleum), solvent-refined light naphthenic, hydrotreated	91995-54-9	Contains (regardless of intentional or impurities)	chemical products
18370	Extract residues (coal), benzole fraction alkaline, acid extract	91995-61-8	Contains (regardless of intentional or impurities)	chemical products
18371	Extract oils (coal), coal tar-residual pyrolysis oils, naphthalene oil, redistillate	91995-66-3	Contains (regardless of intentional or impurities)	chemical products
18372	Extracts (petroleum), catalytic reformed light naphtha solvent	91995-68-5	Contains (regardless of intentional or impurities)	chemical products
18373	Extracts (petroleum), hydrotreated light paraffinic distillate solvent	91995-73-2	Contains (regardless of intentional or impurities)	chemical products
18374	Extracts (petroleum), light naphthenic distillate solvent, hydrosulfurized	91995-75-4	Contains (regardless of intentional or impurities)	chemical products
18375	Extracts (petroleum), light paraffinic distillate solvent, acid-treated	91995-76-5	Contains (regardless of intentional or impurities)	chemical products
18376	Extracts (petroleum), light paraffinic distillate solvent, hydrosulfurized	91995-77-6	Contains (regardless of intentional or impurities)	chemical products
18377	Extracts (petroleum), light vacuum gas oil solvent	91995-78-7	Contains (regardless of intentional or impurities)	chemical products
18378	Extracts (petroleum), light vacuum gas oil solvent, hydrotreated	91995-79-8	Contains (regardless of intentional or impurities)	chemical products
18379	Fatty acids, C9-13-neo-, barium salts	92044-82-1	Intentional addition / 1,000ppm	chemical products
18380	Fatty acids, olive-oil, barium salts	92044-97-8	Intentional addition / 1,000ppm	chemical products
18381	Fatty acids, rape-oil, barium salts	92045-02-8	Intentional addition / 1,000ppm	chemical products
18382	Foos oil (petroleum), hydrotreated	92045-12-0	Contains (regardless of intentional or impurities)	chemical products
18383	Fuel oil, heavy, high-sulfur	92045-14-2	Contains (regardless of intentional or impurities)	chemical products
18384	Gases (petroleum), gas oil diethanolamine scrubber off	92045-15-3	Contains (regardless of intentional or impurities)	chemical products
18385	Gases (petroleum), gas oil hydrosulfurization effluent	92045-16-4	Contains (regardless of intentional or impurities)	chemical products
18386	Gases (petroleum), gas oil hydrosulfurization purge	92045-17-5	Contains (regardless of intentional or impurities)	chemical products
18387	Gases (petroleum), hydrogenator effluent flash drum off	92045-18-6	Contains (regardless of intentional or impurities)	chemical products
18388	Gases (petroleum), naphtha steam cracking high-pressure residual	92045-19-7	Contains (regardless of intentional or impurities)	chemical products
18389	Gases (petroleum), residue visbreaking off	92045-20-0	Contains (regardless of intentional or impurities)	chemical products
18390	Gases (petroleum), steam-cracker C3-rich	92045-22-2	Contains (regardless of intentional or impurities)	chemical products
18391	Hydrocarbons, C4, steam-cracker distillate	92045-23-3	Contains (regardless of intentional or impurities)	chemical products
18392	Gas oils (petroleum), thermal-cracked, hydrosulfurized	92045-29-9	Contains (regardless of intentional or impurities)	chemical products
18393	Lubricating oils (petroleum), C17-35, solvent-extracted, dewaxed, hydrotreated	92045-42-6	Contains (regardless of intentional or impurities)	chemical products
18394	Lubricating oils (petroleum), hydrocracked nonaromatic solvent-deparaffined	92045-43-7	Contains (regardless of intentional or impurities)	chemical products
18395	Naphtha (petroleum), C4-12 butane-alkylate, isooctane-rich	92045-49-3	Contains (regardless of intentional or impurities)	chemical products
18396	Naphtha (petroleum), heavy catalytic cracked, sweetened	92045-50-6	Contains (regardless of intentional or impurities)	chemical products
18397	Naphtha (petroleum), heavy steam-cracked, hydrogenated	92045-51-7	Contains (regardless of intentional or impurities)	chemical products
18398	Naphtha (petroleum), hydrosulfurized full-range	92045-52-8	Contains (regardless of intentional or impurities)	chemical products
18399	Naphtha (petroleum), hydrosulfurized light, dearomatized	92045-53-9	Contains (regardless of intentional or impurities)	chemical products
18400	Hydrocarbons, hydrotreated light naphtha distillates, solvent-refined	92045-55-1	Contains (regardless of intentional or impurities)	chemical products
18401	Naphtha (petroleum), hydrotreated light steam-cracked	92045-57-3	Contains (regardless of intentional or impurities)	chemical products
18402	Naphtha, petroleum, isomerization, C6-fraction	92045-58-4	Contains (regardless of intentional or impurities)	chemical products
18403	Naphtha (petroleum), light catalytic cracked sweetened	92045-59-5	Contains (regardless of intentional or impurities)	chemical products
18404	Naphtha (petroleum), light, C5-rich, sweetened	92045-60-8	Contains (regardless of intentional or impurities)	chemical products
18405	Hydrocarbons, C4-12, naphtha-cracking, hydrotreated	92045-61-9	Contains (regardless of intentional or impurities)	chemical products
18406	Hydrocarbons, C8-11, naphtha-cracking, toluene cut	92045-62-0	Contains (regardless of intentional or impurities)	chemical products
18407	Hydrocarbons, C4-11, naphtha-cracking, aromatic-free	92045-63-1	Contains (regardless of intentional or impurities)	chemical products
18408	Hydrocarbons, C6-7, naphtha-cracking, solvent-refined	92045-64-2	Contains (regardless of intentional or impurities)	chemical products
18409	Naphtha (petroleum), light thermal cracked, sweetened	92045-65-3	Contains (regardless of intentional or impurities)	chemical products
18410	Paraffin waxes (coal), brown-coal high-temperature tar	92045-71-1	Contains (regardless of intentional or impurities)	chemical products
18411	Paraffin waxes (coal), brown-coal high-temperature tar, hydrotreated	92045-72-2	Contains (regardless of intentional or impurities)	chemical products
18412	Petrolatum (petroleum), hydrotreated	92045-77-7	Contains (regardless of intentional or impurities)	chemical products
18413	Petroleum gases, liquefied, sweetened, C4 fraction	92045-80-2	Contains (regardless of intentional or impurities)	chemical products
18414	Residual oils (petroleum), hydrocracked acid-treated solvent-dewaxed	92061-86-4	Contains (regardless of intentional or impurities)	chemical products
18415	Residues (coal tar), anthracene oil distillation	92061-92-2	Contains (regardless of intentional or impurities)	chemical products
18416	Residues (coal tar), creosote oil distillation	92061-93-3	Contains (regardless of intentional or impurities)	chemical products
18417	Residues (coal tar), pitch distillation	92061-94-4	Contains (regardless of intentional or impurities)	chemical products
18418	Residues (petroleum), catalytic cracking	92061-97-7	Contains (regardless of intentional or impurities)	chemical products
18419	Residues (petroleum), hydrogenated steam-cracked naphtha	92062-00-5	Contains (regardless of intentional or impurities)	chemical products
18420	Residues (petroleum), steam-cracked naphtha distillation	92062-04-9	Contains (regardless of intentional or impurities)	chemical products
18421	Slack wax, petroleum, hydrotreated	92062-09-4	Contains (regardless of intentional or impurities)	chemical products
18422	Slack wax (petroleum), low-melting	92062-10-7	Contains (regardless of intentional or impurities)	chemical products
18423	Slack wax (petroleum), low-melting, hydrotreated	92062-11-8	Contains (regardless of intentional or impurities)	chemical products
18424	Slimes and sludges, zinc ore roasting gas desulfurization	92062-13-0	Contains (regardless of intentional or impurities)	chemical products
18425	Solvent naphtha (petroleum), hydrotreated light naphthenic	92062-15-2	Contains (regardless of intentional or impurities)	chemical products
18426	Tar, coal, high-temperature, distillation and storage residues	92062-20-9	Contains (regardless of intentional or impurities)	chemical products
18427	Tar acids, brown-coal gasification	92062-22-1	Contains (regardless of intentional or impurities)	chemical products
18428	Tar acids, cresylic	92062-26-5	Contains (regardless of intentional or impurities)	chemical products
18429	Tar bases, coal, aniline fraction	92062-27-6	Contains (regardless of intentional or impurities)	chemical products
18430	Tar bases, coal, collidine fraction	92062-28-7	Contains (regardless of intentional or impurities)	chemical products
18431	Tar bases, coal, distillation residues - The distillation residue remaining after the distillation of the neutralized, acid-extracted base-containing tar fractions obtained by the distillation of coal tars. It contains chiefly aniline, collidines, quinoline and quinoline derivatives and toluidines.	92062-29-8	Contains (regardless of intentional or impurities)	chemical products
18432	Tar bases, coal, picoline fraction	92062-33-4	Contains (regardless of intentional or impurities)	chemical products
18433	Waste solids, coal-tar pitch coking	92062-34-5	Contains (regardless of intentional or impurities)	chemical products
18434	Aromatic hydrocarbons, C9-12, benzene distillation	92062-36-7	Contains (regardless of intentional or impurities)	chemical products
18435	Hexane, branched and linear	92112-69-1	Intentional addition / 1,000ppm	chemical products
18436	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, hydrogen bis[3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]cobaltate(3-)(1:2:1), bis[3-(C8-18-alkylamino)butanoate]	92112-83-9	Intentional addition / 1%	chemical products
18437	Amines, C18-22-tert-alkyl, compounds with molybdic acid (H2MoO4)	92113-03-6	1,000ppm	chemical products
18438	Fatty acids, soya, reaction products with boric acid (H3BO3) and diisopropanolamine	92128-16-0	1%	chemical products
18439	Fatty acids, tall-oil, reaction products with boric acid (H3BO3) and diisopropanolamine	92128-25-1	1%	chemical products
18440	Glass, nonoxide, chemicals	92128-37-5	Contains (regardless of intentional or impurities)	chemical products
18441	Hydrocarbons, C8-12, catalytic-cracking, chemically neutralized	92128-94-4	Contains (regardless of intentional or impurities)	chemical products
18442	Paraffin oils (petroleum), solvent-refined dewaxed neutral	92129-09-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
18443	Slags, heavy fuel oil gasification-partial oxidation	92129-56-1	Contains (regardless of intentional or impurities)	chemical products
18444	Slimes and sludges, copper electrolytic refining, decopperized, nickel sulfate	92129-57-2	Contains (regardless of intentional or impurities)	chemical products
18445	Tri-n-propylisobutyltin	92154-74-0	Contains (regardless of intentional or impurities)	chemical products
18446	Barium, C4-10-fatty acid octanoate complexes	92200-78-7	Intentional addition / 1,000ppm	chemical products
18447	Cobalt, C4-10-fatty acid octanoate complexes	92200-85-6	Intentional addition / 1%	chemical products
18448	Copper, C5-23-branched carboxylate naphthenate complexes	92200-86-7	Intentional addition / 1,000ppm	chemical products
18449	Copper, C5-23-branched carboxylate naphthenate octanoate complexes	92200-87-8	Intentional addition / 1,000ppm	chemical products
18450	Iron, C5-23-branched carboxylate naphthenate complexes	92200-90-3	1%	chemical products
18451	Iron, C5-23-branched carboxylate naphthenate octanoate complexes	92200-91-4	1%	chemical products
18452	Manganese, C5-23-branched carboxylate naphthenate complexes	92200-85-8	Contains (regardless of intentional or impurities)	chemical products
18453	Manganese, C5-23-branched carboxylate naphthenate octanoate complexes	92200-86-9	Contains (regardless of intentional or impurities)	chemical products
18454	Nickel, C5-23-branched carboxylate naphthenate complexes	92200-88-1	Contains (regardless of intentional or impurities)	chemical products
18455	Nickel, C5-23-branched carboxylate naphthenate octanoate complexes	92200-89-2	Contains (regardless of intentional or impurities)	chemical products
18456	1-Nonanol, branched, esters with boric acid (H3BO3)	92201-90-8	1%	chemical products
18457	Zirconium, C4-10-fatty acid octanoate complexes	92201-10-0	Contains (regardless of intentional or impurities)	chemical products
18458	Zirconium, C4-10-fatty acid octanoate complexes	92201-11-1	Contains (regardless of intentional or impurities)	chemical products
18459	Carboxylic acids, C5-7, cobalt salts	92201-51-9	Intentional addition / 1%	chemical products
18460	Distillates (petroleum), intermediate catalytic cracked, thermally degraded	92201-59-7	Contains (regardless of intentional or impurities)	chemical products
18461	Distillates (petroleum), light catalytic cracked, thermally degraded	92201-60-0	Contains (regardless of intentional or impurities)	chemical products
18462	Naphtha (petroleum), light heat-soaked, steam-cracked	92201-97-3	Contains (regardless of intentional or impurities)	chemical products
18463	Quaternary ammonium compounds, benzyl-C12-18-alkyldimethyl, salts with chromic acid (H2CrO7) (2:1)	92202-10-3	Contains (regardless of intentional or impurities)	chemical products
18464	Shell, oyster, reaction products with antimony sulfide and sulfur	92202-25-0	Contains (regardless of intentional or impurities)	chemical products
18465	Waste solids, copper electrolytic, tin-rich	92202-46-5	Intentional addition / 1,000ppm	chemical products
18466	Phosphoric acid, reaction products with aluminum hydroxide and chromium oxide (CrO3)	92203-02-6	Contains (regardless of intentional or impurities)	chemical products
18467	Phosphoric acid, reaction products with aluminum hydroxide, chromium oxide (CrO3) and diethanolamine	92203-03-7	Contains (regardless of intentional or impurities)	chemical products
18468	Vanadium, tetrachloro(2-pyridinamine-N1)-	92221-02-8	Intentional addition / 1%	chemical products
18469	Amines, C12-14-tert-alkyl, bis[4-chloro-2-[[2-[[dimethylphenylamino]-1-naphthalenyl]azo]phenolato(2-)]cobaltate(1-)(1:1)	92257-03-9	Intentional addition / 1%	chemical products
18470	Amines, C12-14-tert-alkyl, bis[4-[[5-chloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]cobaltate(1-)(1:1)	92257-04-0	Intentional addition / 1%	chemical products
18471	Fatty acids, C8-10-branched, cadmium salts	92257-06-2	Contains (regardless of intentional or impurities)	chemical products
18472	Fatty acids, C8-10-branched, cobalt(2+) salts	92257-08-4	Intentional addition / 1%	chemical products
18473	Leach residues, zinc refining flue dust, cadmium-thallium precipitate	92257-11-9	Contains (regardless of intentional or impurities)	chemical products
18474	Boric acid (H3BO3), reaction products with 2-amino-1-butanol	92257-22-2	1%	chemical products
18475	Cobalt(III) chloride tetrahydrofuran complex (1:1)	92258-02-1	Intentional addition / 1%	chemical products
18476	(Dimethylamino)dimethylindium	92274-82-3	1%	chemical products
18477	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[4-(sulfithio)phenyl]amino]sulfonyl derivatives, sodium salts	92302-64-2	Intentional addition / 1,000ppm	chemical products
18478	Boric acid (H3BO3), reaction products with by-products from manufacture of 2-butoxyethanol	92332-17-7	1%	chemical products
18479	Copper, 2-naphthalenol-sodium sulfide (Na2(Sx)) reaction products complexes	92332-18-8	Intentional addition / 1,000ppm	chemical products
18480	Octene, bromo-	92348-34-0	1,000ppm	chemical products
18481	2,2,3,4,4-Pentahydroxybenzophenone	92379-42-5	Contains (regardless of intentional or impurities)	chemical products
18482	Chromate(1-), diaqua(2-hydroxybenzoato(2-)-O1,O2)(3-hydroxy-2-naphthalenecarboxylato(2-)-O2,O3)-, hydrogen	92388-81-3	Contains (regardless of intentional or impurities)	chemical products
18483	Manganese oxide (MnO4), (T-4)-	92414-44-3	1%	chemical products
18484	2,3-Epoxypropyl propionate	92418-56-9	Contains (regardless of intentional or impurities)	chemical products
18485	Acacia mearnsi, extract, reaction products with chromium sulfate and sodium hydroxide	92456-59-2	1,000ppm	chemical products
18486	Chromium, stearate aluminum complexes	92502-52-8	1,000ppm	chemical products
18487	Cobalt, borate 2-ethylhexanoate neodecanoate complexes	92502-53-9	Intentional addition / 1%	chemical products
18488	Nickel, borate neodecanoate complexes	92502-55-1	Contains (regardless of intentional or impurities)	chemical products
18489	Leuco sulfonated phenols copper complexes	92625-82-0	Intentional addition / 1,000ppm	chemical products
18490	Acetic acid, mercapto-, 2-propoxyethyl ester, antimony(3+) salt	92687-27-9	Contains (regardless of intentional or impurities)	chemical products
18491	Acetic acid, mercapto-, 2-butoxyethyl ester, antimony(3+) salt	92687-28-0	Contains (regardless of intentional or impurities)	chemical products
18492	Acetic acid, mercapto-, 2-phenoxyethyl ester, antimony(3+) salt	92687-31-5	Contains (regardless of intentional or impurities)	chemical products
18493	Amines, C12-14-tert-alkyl, bis[2-[[2-(2-hydroxyphenyl)azo]-3-oxo-N-phenylbutanamido(2-)]cobaltate(1-)(1:1)	92703-96-3	Intentional addition / 1%	chemical products
18494	Extracts (petroleum), heavy paraffinic distillate solvent, clay-treated	92704-08-0	Contains (regardless of intentional or impurities)	chemical products
18495	Fatty acids, C9-13-neo-, cadmium salts	92704-12-6	Contains (regardless of intentional or impurities)	chemical products
18496	Fatty acids, olive-oil, cadmium salts	92704-15-9	Contains (regardless of intentional or impurities)	chemical products
18497	Fatty acids, peanut-oil, cadmium salts	92704-19-3	Contains (regardless of intentional or impurities)	chemical products
18498	Fatty acids, rape-oil, cadmium salts	92704-24-0	Contains (regardless of intentional or impurities)	chemical products
18499	Antimony alloy, dross	92731-36-7	Contains (regardless of intentional or impurities)	chemical products
18500	Copper, 2-naphthalenol-sodium sulfide (Na2(Sx)) reaction products complexes, thiosulfonated	92731-39-0	Intentional addition / 1,000ppm	chemical products
18501	Fatty acids, C14-18 and C18-unsaturated, branched and linear, hydrogenated, cadmium salts	92797-28-9	Contains (regardless of intentional or impurities)	chemical products
18502	Hexanedioic acid, molybdenum(2+) salt (1:1)	92799-92-3	1,000ppm	chemical products
18503	L-Alanine, N-benzoyl-, compound with strychnidin-10-one (1:1)	92818-46-7	Contains (regardless of intentional or impurities)	chemical products
18504	Copper, diazotized 3-amino-5-chloro-4-hydroxybenzenesulfonic acid-2,2'-[[1,2-ethenediyl]bis[5-nitrobenzenesulfonic acid]-3-methoxybenzenamine coupling products complexes	92908-13-9	Intentional addition / 1,000ppm	chemical products
18505	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-2-sulfonylamino]sulfonyl amino sulfonyl sulfo derivatives, sodium salts	92908-14-0	Intentional addition / 1,000ppm	chemical products
18506	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[3-(aminosulfonyl)phenyl]amino]sulfonyl sulfo derivatives, reaction products with 1,4-dichloro-6-phthalazinecarbonyl chloride	92908-15-1	Intentional addition / 1,000ppm	chemical products
18507	Cuprate(4-), [2-[[[3-[[4-chloro-6-[[2-chloro-5-sulfophenyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulfophenyl]azophenylmethyl]azo]-4-sulfobenzoato(6-)]-, trisodium hydrogen	92908-46-8	Intentional addition / 1,000ppm	chemical products
18508	Fatty acids, C18-28, manganese salts	92969-67-0	Contains (regardless of intentional or impurities)	chemical products
18509	Bis(chlorotrioxosulfuric acid) methylene	92975-18-3	Contains (regardless of intentional or impurities)	chemical products
18510	Benzenesulfonic acid, C10-60-alkyl derivatives, barium salts	93028-28-5	Intentional addition / 1,000ppm	chemical products
18511	Chromium, acetate formate hydroxy complexes	93028-32-1	1,000ppm	chemical products
18512	Chromium, acetate oxalate complexes	93028-33-2	1,000ppm	chemical products
18513	Octanoic acid, branched, cobalt(2+) salts	93028-48-9	Intentional addition / 1%	chemical products
18514	Phenol, nonyl-, barium salt, basic	93028-52-5	Intentional addition / 1,000ppm	chemical products
18515	Cobalt, acetate borate complexes	93062-36-3	Intentional addition / 1%	chemical products
18516	Cobalt, borate C8-10-branched fatty acids complexes	93062-37-4	Intentional addition / 1%	chemical products
18517	N-(Methoxyethyl)-N-(trimethylsilylmethyl)benzylamine	93102-05-7	Contains (regardless of intentional or impurities)	chemical products
18518	Distillates (petroleum), C6-rich	93165-19-6	Contains (regardless of intentional or impurities)	chemical products
18519	Naphtha (petroleum), light steam-cracked, hydrogenated	93165-55-0	Contains (regardless of intentional or impurities)	chemical products
18520	Ethanol, 2-butoxy-, ester with boric acid (H3BO3)	93165-87-8	1%	chemical products
18521	Ethanol, 2-(2-butoxyethoxy)-, ester with boric acid (H3BO3)	93165-88-9	1%	chemical products
18522	Ethanol, 2-[[2-(2-methoxyethoxy)ethoxy]-, ester with boric acid (H3BO3)	93165-89-0	1%	chemical products
18523	1-Tridecanol, phosphate, cobalt(2+) salt	93165-90-3	Intentional addition / 1%	chemical products
18524	Barium, benzoate 2-[3-(1,3-dihydro-1,3,3-trimethyl-2H-indol-2-ylidene)-1-propenyl]-1,3,3-trimethyl-3H-indolium ethyl 2-[3,6-bis(ethylamino)-2,7-dimethyl-9H-xanthen-9-yl]benzoate aluminum complexes	93165-93-6	Intentional addition	chemical products
18525	Tin, butyl oxo tall-oil fatty acids complexes	93166-09-7	1,000ppm	chemical products
18526	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]cobaltate(1-), 3-(C8-18-alkylamino)butanoate(2-)	93166-11-1	Intentional addition / 1%	chemical products
18527	Dihydrogen [3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]methyl [7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthyl]carbamato(2-)]chromate(2-)	93293-65-3	Contains (regardless of intentional or impurities)	chemical products
18528	Fatty acids, C7-9-branched, manganese(2+) salts	93333-98-3	Contains (regardless of intentional or impurities)	chemical products
18529	Hydrogen bis[2-[[5-(aminosulphonyl)-2-hydroxyphenyl]azo]-N-(2-chlorophenyl)-3-oxobutylamido(2-)]cobaltate(1-)	93338-23-9	Intentional addition / 1%	chemical products
18530	Diammonium pentachloroferrate(2-)	93346-52-2	1%	chemical products
18531	3-(Chloromethyl)-5,5-diphenylhydantoin	93360-07-7	Contains (regardless of intentional or impurities)	chemical products
18532	Cadmium, bis(nonafluorobutyl)-	93367-04-5	Contains (regardless of intentional or impurities)	chemical products
18533	Dodecanoic acid, barium salt, basic	93384-78-2	Intentional addition / 1,000ppm	chemical products
18534	Fatty acids, tallow, copper salts	93455-91-5	Intentional addition / 1,000ppm	chemical products
18535	Propanol, [2-[[2-(2-hydroxyethoxy)ethoxy]ethoxy]-, ester with boric acid (H3BO3)	93571-70-1	1%	chemical products
18536	Aromatic hydrocarbons, C7-12, C8-rich	93571-75-6	Contains (regardless of intentional or impurities)	chemical products
18537	Ashes (residues), heavy fuel oil fly	93571-76-7	Contains (regardless of intentional or impurities)	chemical products
18538	Gasoline, C5-11, high-octane stabilized reformed	93572-29-3	Contains (regardless of intentional or impurities)	chemical products
18539	Hydrocarbons, C7-12, C9-aromatic-rich, reforming heavy fraction	93572-35-1	Contains (regardless of intentional or impurities)	chemical products
18540	Hydrocarbons, C5-11, nonaromatic-rich, reforming light fraction	93572-36-2	Contains (regardless of intentional or impurities)	chemical products
18541	Lubricating oils (petroleum), base oils, paraffinic	93572-43-1	Contains (regardless of intentional or impurities)	chemical products
18542	Quaternary ammonium compounds, C12-14-alkyl(carboxymethyl)dimethyl, bis[[dihydroxy(oxophenyl)-1H-pyrazolyl]azo]benzoato(2-)]chromate(1-)(1:1), compounds with (C8-18-alkylamino)butanoic acid	93572-59-9	Contains (regardless of intentional or impurities)	chemical products
18543	Slimes and sludges, copper alloy cleaning, phosphoric acid	93572-65-7	Intentional addition / 1,000ppm	chemical products
18544	Chromate(1-), bis[1-[[2-hydroxy-4(or 6)-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen, compound with 3-(C8-18-alkylamino)butanoic acid (1:1)	93572-86-2	Contains (regardless of intentional or impurities)	chemical products
18545	Chromate(1-), bis[1-[[2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]-, hydrogen, compound with 3-(C8-18-alkylamino)butanoic acid (1:1)	93572-87-3	Contains (regardless of intentional or impurities)	chemical products
18546	Cobaltate(1-), bis[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, heptyl derivatives, hydrogen, compound with 3-(C8-18-alkylamino)butanoic acid (1:1)	93572-88-4	Intentional addition / 1%	chemical products
18547	Cobaltate(1-), bis[1-[[2-hydroxy-4(or 6)-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen, compound with 3-(C8-18-alkylamino)butanoic acid (1:1)	93572-89-5	Intentional addition / 1%	chemical products
18548	Cobaltate(3-), bis[2-hydroxy-5-methyl-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, trisodium hydrogen, compound with 3-(C8-18-alkylamino)butanoic acid and 4,4-carboniodiylbis[N,N-dimethylbenzenamine] (1:2:1)	93572-90-8	Intentional addition / 1%	chemical products
18549	Copper, 4,4'-azobis[12-methoxy-4-1-phenylene]azo(8-hydroxy-6-sulfo-7,2-naphthalenediylidino)bis(benzoate) complexes	93572-91-9	Intentional addition / 1,000ppm	chemical products
18550	Copper, C5-23-branched carboxylate C4-10 fatty acids complexes	93572-92-0	Intentional addition / 1,000ppm	chemical products
18551	Copper, C4-10 fatty acids octanoate complexes	93572-93-1	Intentional addition / 1,000ppm	chemical products

(Appendix table 1) MISUMI Specified Chemical Substances

Ver.2.0.0 date of revision 5/31/2022 Misumi Corporation

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
18552	Cuprate(3-), [5-amino-4-hydroxy-3-[[2-hydroxy-4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(5-)]-, sodium	93572-96-4	Intentional addition / 1,000ppm	chemical products
18553	Cuprate(4-), [5-amino-4-hydroxy-3-[[5-hydroxy-6-[[2-hydroxy-4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-7-sulfo-2-naphthalenyl]azo]-2,7-naphthalenedisulfonato(6-)]-, sodium	93572-97-5	Intentional addition / 1,000ppm	chemical products
18554	Cuprate(4-), [4-amino-5-hydroxy-6-[[2-hydroxy-5-sulphophenyl]azo]-3-[[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(6-)]-, sodium	93572-98-6	Intentional addition / 1,000ppm	chemical products
18555	Iron, C4-10 fatty acids naphthenate complexes	93573-04-7	1%	chemical products
18556	Manganese, C4-10 fatty acids naphthenate complexes	93573-11-6	Contains (regardless of intentional or impurities)	chemical products
18557	Manganese, C4-10 fatty acids octanoate complexes	93573-12-7	Contains (regardless of intentional or impurities)	chemical products
18558	Nickel, C5-23-branched carboxylate C4-10 fatty acids naphthenate complexes	93573-14-9	Contains (regardless of intentional or impurities)	chemical products
18559	Nickel, C4-10 fatty acids naphthenate complexes	93573-15-0	Contains (regardless of intentional or impurities)	chemical products
18560	Nickel, C4-10 fatty acids octanoate complexes	93573-16-1	Contains (regardless of intentional or impurities)	chemical products
18561	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with 2-[[4-(aminophenyl)sulfonyl]ethyl]hydrogen sulfate monosodium salt, potassium sodium salts, compounds with pyridine	93573-17-2	Contains (regardless of intentional or impurities)	chemical products
18562	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, hydrogen bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]chromate(3-)(1:2:1), bis[3-(C8-18-alkylamino)butanoate]	93573-23-0	Contains (regardless of intentional or impurities)	chemical products
18563	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, hydrogen bis[2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-5-methylbenzenesulfonato(3-)]cobaltate(3-)(2:1:1), mono[3-(C8-18-alkylamino)butanoate]	93573-24-1	Intentional addition / 1%	chemical products
18564	Scandium trivanadium nonaoxide	93585-66-1	Intentional addition / 1%	chemical products
18565	Terbium trivanadium nonaoxide	93585-67-2	Intentional addition / 1%	chemical products
18566	Thulium vanadium oxide	93585-68-3	Intentional addition / 1%	chemical products
18567	Trivanadium ytterbium nonaoxide	93585-69-4	Intentional addition / 1%	chemical products
18568	Ammonium [N,N-bis(carboxymethyl)glycinato(3-)-N,O,O']cobaltate(1-)	93601-32-2	Intentional addition / 1%	chemical products
18569	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]N-(7-hydroxy-8-[[2-hydroxy-5-nitrophenyl]azo]-1-naphthalenyl)acetamidato(2-)]-, sodium hydrogen	93606-19-0	Contains (regardless of intentional or impurities)	chemical products
18570	Chromate(2-), [1-[[2-hydroxy-3,5-dinitrophenyl]azo]-2-naphthalenolato(2-)]3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium hydrogen	93606-20-3	Contains (regardless of intentional or impurities)	chemical products
18571	N-[[beta-(Benzolbifuran-2-yl)acryloyl]-N-trichloroacetohydrazide]	93641-38-4	Contains (regardless of intentional or impurities)	chemical products
18572	Terbium telluride	93658-88-9	Contains (regardless of intentional or impurities)	chemical products
18573	Nonanoic acid, branched, barium salt	93686-39-6	Intentional addition / 1,000ppm	chemical products
18574	Nonanoic acid, branched, cadmium salt	93686-40-9	Contains (regardless of intentional or impurities)	chemical products
18575	Nonanoic acid, branched, cobalt(2+) salt	93686-41-0	Intentional addition / 1%	chemical products
18576	Stannane, tributyl[[1-(oxo)oxy]oxy]-, branched	93686-53-9	Contains (regardless of intentional or impurities)	chemical products
18577	1-Tetradecanaminium, N-ethyl-2-hydroxy-N-(2-hydroxytetradecyl)-N-methyl-, bis[8-amino-1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]chromate(1-)	93693-29-4	Contains (regardless of intentional or impurities)	chemical products
18578	Chromate(1-), bis[8-amino-1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen, compound with 3-(octyloxy)-1-propanamine (1:1)	93693-30-2	Contains (regardless of intentional or impurities)	chemical products
18579	Oxykhom	93746-30-6	Intentional addition / 1,000ppm	chemical products
18580	N-(4-Diethylaminobenzylidene)aniline N-oxide	93749-91-8	Contains (regardless of intentional or impurities)	chemical products
18581	Benzoic acid, 2-amino-, barium salt (2:1)	93762-40-4	Contains (regardless of intentional or impurities)	chemical products
18582	Copper, C5-23-branched carboxylate C4-10 fatty acids naphthenate complexes	93762-51-7	Intentional addition / 1,000ppm	chemical products
18583	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with 2-[[4-(aminophenyl)sulfonyl]ethyl]hydrogen sulfate monosodium salt, saponified, sodium salts, compounds with pyridine	93762-52-8	Intentional addition / 1,000ppm	chemical products
18584	Iron, C5-23-branched carboxylate C4-10 fatty acids naphthenate complexes	93762-57-3	1%	chemical products
18585	Manganese, C5-23-branched carboxylate C4-10 fatty acids naphthenate complexes	93762-58-4	Contains (regardless of intentional or impurities)	chemical products
18586	Nickel, C5-23-branched carboxylate C4-10 fatty acids complexes	93762-59-5	Contains (regardless of intentional or impurities)	chemical products
18587	Calcines, uranium ore-concentrate - Calcined precipitates of ammonium, magnesium or sodium uranates obtained from natural uranium ores.	93763-02-1	Contains (regardless of intentional or impurities)	chemical products
18588	Extracts (petroleum), heavy naphthenic distillate solvent, hydrodesulfurized	93763-10-1	Contains (regardless of intentional or impurities)	chemical products
18589	Extracts (petroleum), solvent-dewaxed heavy paraffinic distillate solvent, hydrodesulfurized	93763-11-2	Contains (regardless of intentional or impurities)	chemical products
18590	Fatty acids, C14-26, barium salts	93763-14-5	Intentional addition / 1,000ppm	chemical products
18591	Hydrocarbons, C6-11, hydrotreated, dearomatized	93763-33-8	Contains (regardless of intentional or impurities)	chemical products
18592	Hydrocarbons, C9-12, hydrotreated, dearomatized	93763-34-9	Contains (regardless of intentional or impurities)	chemical products
18593	Hydrocarbons, hydrocracked paraffinic distillation residues, solvent-dewaxed	93763-38-3	Contains (regardless of intentional or impurities)	chemical products
18594	Oils, sperm, reaction products with barium hydroxide	93763-61-2	Intentional addition	chemical products
18595	Residues (petroleum), steam-cracked heat-soaked naphtha	93763-85-0	Contains (regardless of intentional or impurities)	chemical products
18596	Cobaltate(5-), [4-[[[4-chloro-6-(2-ethoxyethoxy)-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]4-[[[4-chloro-6-(2-ethoxyethoxy)-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, pentasodium	93764-01-3	Intentional addition / 1%	chemical products
18597	Chromate(1-), [4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]2-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-3H-pyrazol-3-onato(2-)]-, sodium	93776-32-0	Contains (regardless of intentional or impurities)	chemical products
18598	Chromate(1-), [4-[[4-[[5-chloro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]4-[[4-[[3,5-dichloro-2-hydroxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, sodium	93776-33-1	Contains (regardless of intentional or impurities)	chemical products
18599	Sodium bis[5-[[5-chloro-2-hydroxyphenyl]azo]-6-hydroxynaphthalene-2-sulphonamidato(2-)]cobaltate(1-)	93776-34-2	Intentional addition / 1%	chemical products
18600	Sodium bis[5-[[5-chloro-2-hydroxyphenyl]azo]-6-hydroxynaphthalene-2-sulphonamidato(2-)]chromate(1-)	93776-35-3	Contains (regardless of intentional or impurities)	chemical products
18601	Cobaltate(1-), [2-[[2-amino-1-naphthalenyl]azo]-5-nitrophenolato(2-)]N-(2-chlorophenyl)-2[[2-hydroxy-5-[[methylamino)sulfonyl]phenyl]azo]-3-oxobutanamidato(2-)]-, sodium	93776-36-4	Intentional addition / 1%	chemical products
18602	Chromate(1-), [4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]6-hydroxy-5-[[2-hydroxy-3,5-dinitrophenyl]azo]-2-naphthalenesulfonato(2-)]-, sodium	93776-37-5	Contains (regardless of intentional or impurities)	chemical products
18603	Sodium bis[2,4-dihydroxy-3,3-dimethylbutyrato(2-)-O1,O2,O4]ferrate(1-)	93776-38-6	1%	chemical products
18604	Iron tris(isononanoate)	93776-39-7	1%	chemical products
18605	Copper(II) octahydro-4,7-methano-1H-indenedicarboxylate	93776-43-3	Intentional addition / 1,000ppm	chemical products
18606	[29H,31H-phthalocyanine-2,9-dithiolato(2-)-N29,N30,N31,N32]copper, disodium salt	93776-48-6	Intentional addition / 1,000ppm	chemical products
18607	[29H,31H-phthalocyanine-2,10-dithiolato(2-)-N29,N30,N31,N32]copper, disodium salt	93776-49-9	Intentional addition / 1,000ppm	chemical products
18608	[29H,31H-phthalocyanine-2,16-dithiolato(2-)-N29,N30,N31,N32]copper, disodium salt	93776-50-2	Intentional addition / 1,000ppm	chemical products
18609	[29H,31H-phthalocyanine-2,17-dithiolato(2-)-N29,N30,N31,N32]copper, disodium salt	93776-51-3	Intentional addition / 1,000ppm	chemical products
18610	[29H,31H-phthalocyanine-2,9,16-trithiolato(2-)-N29,N30,N31,N32]copper, trisodium salt	93776-52-4	Intentional addition / 1,000ppm	chemical products
18611	[29H,31H-phthalocyanine-2,9,17-trithiolato(2-)-N29,N30,N31,N32]copper, trisodium salt	93776-53-5	Intentional addition / 1,000ppm	chemical products
18612	[29H,31H-phthalocyanine-2,10,16-trithiolato(2-)-N29,N30,N31,N32]copper, trisodium salt	93776-54-6	Intentional addition / 1,000ppm	chemical products
18613	[29H,31H-phthalocyanine-2,9,16,23-tetrithiolato(2-)-N29,N30,N31,N32]copper, tetrasodium salt	93776-55-7	Intentional addition / 1,000ppm	chemical products
18614	Cobalt bis(citratato(3-))di-mu-oxodioximolybdate(2-)	93776-58-0	Contains (regardless of intentional or impurities)	chemical products
18615	Diantimony(3+) triethylene hexakis(sulphidoacetate)	93776-64-8	Contains (regardless of intentional or impurities)	chemical products
18616	Iron(3+) potassium 2-hydroxypropane-1,2,3-tricarboxylate(3:3:4)	93776-70-6	1%	chemical products
18617	(Hydroxyborylene)bis[oxo(2-hydroxypropane-1,3-diylo)] diesterate	93777-11-8	1%	chemical products
18618	8,8-Didodecyl-1,4-dioxo-7,9-dithia-8-stannacycloundecane-5,11-dione	93778-53-1	Contains (regardless of intentional or impurities)	chemical products
18619	Barium bis(o-nonylphenolate)	93778-54-2	Contains (regardless of intentional or impurities)	chemical products
18620	Trisodium bis[3-[[1-(aminocarbonyl)-2-oxopropyl]azo]-4-hydroxybenzenesulfonato(3-)]chromate(3-)	93783-53-0	Contains (regardless of intentional or impurities)	chemical products
18621	Trihydrogen [4-amino-6-[[6-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-2-hydroxy-4-sulpho-1-naphthyl]azo]-5-hydroxynaphthalene-1,3-disulphonato(5-)]cuprate(3-)	93783-55-2	Intentional addition / 1,000ppm	chemical products
18622	[4-[[4,5-Dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-hydroxy-2-methylbenzene-1-sulphonamidato(2-)]hydroxychromium	93783-56-3	1,000ppm	chemical products
18623	Heptahydrogen bis[2-[[6-[[4-chloro-6-[[4-(2-cyano-2-sulphophenyl)vinyl]-3-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulpho-2-naphthyl]azo]benzoato(5-)]chromate(7-)	93783-57-4	Contains (regardless of intentional or impurities)	chemical products
18624	Tris(hexamene-2,4-dionato-O,O)cobalt	93783-58-5	Intentional addition / 1%	chemical products
18625	Pentahydrogen bis[5-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]naphthalene-2,7-disulphonato(4-)]cobaltate(5-)	93783-60-9	Intentional addition / 1%	chemical products
18626	Chromate(2-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-[[4-[[1-oxo-2-propenyl]amino]phenyl]-1H-pyrazol-4-yl]azo]-5-nitrobenzoato(2-)]2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-sulfobenzoato(3-)]-, dihydrogen	93783-61-0	Contains (regardless of intentional or impurities)	chemical products
18627	Chromate(2-), [2-[[4,5-dihydro-3-methyl-5-oxo-1-[[4-[[1-oxo-2-propenyl]amino]phenyl]-1H-pyrazol-4-yl]azo]benzoato(2-)]2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(3-)]-, dihydrogen	93783-62-1	Contains (regardless of intentional or impurities)	chemical products
18628	Sodium [5-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxybenzene-1,3-disulphonato(4-)]chromate(1-)	93783-63-2	Contains (regardless of intentional or impurities)	chemical products
18629	1,3,4-Thiadiazolium, 5-bis(1-methylethylamino)-2-[[4-(dimethylamino)phenyl]azo]-3-methyl-, trichlorozincate(1-)	93783-70-1	Intentional addition	chemical products
18630	Chromate(3-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]2-hydroxy-3-[[2-hydroxy-5-[[4-(phenylazo)phenyl]azo]phenyl]methylene]amino]-5-nitrobenzenesulfonato(3-)]-, trihydrogen	93783-71-2	Contains (regardless of intentional or impurities)	chemical products
18631	Chromate(3-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]2-hydroxy-3-[[2-hydroxy-5-[[4-(phenylazo)phenyl]azo]phenyl]methylene]amino]-5-nitrobenzenesulfonato(3-)]-, trisodium	93783-72-3	Contains (regardless of intentional or impurities)	chemical products
18632	Bis[5-chloro-2-[[2-hydroxynaphthyl]azo]-4-methylbenzene-1-sulphonato]zirconium	93783-73-4	Contains (regardless of intentional or impurities)	chemical products
18633	Dihydrogen bis[1,2,3,8-tetrahydro-2,6-dioxopyrimidine-4-carboxylato(2-)-N3,O4]ferrate(2-)	93783-74-5	1%	chemical products
18634	Cobaltate(3-), [2-[[3-[[8-(acetyl)amino]-2-hydroxy-1-naphthalenyl]azo]-4-hydroxybenzo]benzoato(3-)]2-[[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzo]benzoato(3-)]-, trihydrogen	93783-75-6	Intentional addition / 1%	chemical products
18635	Trisodium [7-[[4-chloro-6-(3-sulphoamino)-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-sulphophenyl]azo]naphthalene-2-sulphonato(5-)]cuprate(3-)	93803-81-7	Intentional addition / 1,000ppm	chemical products
18636	Barium isohexadecanoate	93803-91-9	Contains (regardless of intentional or impurities)	chemical products
18637	Cobalt(2+) dihydrogen disulphite	93805-27-7	Intentional addition / 1%	chemical products
18638	Tris(6-methylheptane-2,4-dionato-O,O)molybdenum	93805-29-9	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
18639	Trisodium [5-[[[4-[5-[[[2,6-dihydroxy-3-[[2-hydroxy-3,5-disulphophenyl]azo]phenyl]azo]-1H-benzimidazol-2-yl]phenyl]azo]sulfato(3-)]cuprate(3-)]	93805-30-2	Intentional addition / 1,000ppm	chemical products
18640	Tributyl(tert-decanoyloxy)stannane	93805-32-4	Contains (regardless of intentional or impurities)	chemical products
18641	5,5,9,9-Tetrabutyl-7-oxo-6,8-dioxo-7-sila-5,9-distannatridecane	93805-54-0	Contains (regardless of intentional or impurities)	chemical products
18642	(Z)-2'-[[1,4-Dioxobut-2-ene-1,4-diy]bis(oxyl)]bis[2-butyl-1,2,3-dioxostannepin-4,7-dione]	93819-95-5	Contains (regardless of intentional or impurities)	chemical products
18643	Carbonic acid, cadmium salt	93820-02-1	Contains (regardless of intentional or impurities)	chemical products
18644	Hydrogen bis[4-[[5-chloro-2-hydroxyphenyl]azo]-2-(2-chlorophenyl)-2,4-dihydro-5-methyl-3H-pyrazol-3-onato(2-)]cobaltate(1-), compound with bis(2-ethylhexyl)amine (1:1)	93820-10-1	Intentional addition / 1%	chemical products
18645	Cobaltate(1-), bis[4-[[5-chloro-2-hydroxyphenyl]azo]-2-(2-chlorophenyl)-2,4-dihydro-5-methyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 1-butoxy-3-[[1,1,3,3-tetramethylbutyl]amino]-2-propanol (1:1)	93820-12-3	Intentional addition / 1%	chemical products
18646	Trihydrogen bis[2-[4-hydroxy-3-[[2-hydroxy-8-[[1-(oxopropyl)amino]-1-naphthyl]azo]benzoyl]benzoato(3-)]chromate(3-)]	93820-13-4	Contains (regardless of intentional or impurities)	chemical products
18647	Trihydrogen bis[2-[3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]benzoyl]benzoato(3-)]cobaltate(3-)]	93820-14-5	Contains (regardless of intentional or impurities)	chemical products
18648	Trihydrogen bis[2-[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzoyl]benzoato(3-)]chromate(3-)]	93820-16-7	Contains (regardless of intentional or impurities)	chemical products
18649	Trihydrogen bis[2-[3-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzoyl]benzoato(3-)]cobaltate(3-)]	93820-17-8	Intentional addition / 1%	chemical products
18650	Propanol, 2-(2-hydroxyethoxy)ethoxy]-, ester with boric acid (H3BO3)	93820-50-9	1%	chemical products
18651	Benzenesulfonic acid, di-C10-18-alkyl derivatives barium salts	93820-55-4	Intentional addition / 1,000ppm	chemical products
18652	Benzenesulfonic acid, di-C10-18-alkyl derivatives, barium salts, overbased	93820-56-5	Intentional addition / 1,000ppm	chemical products
18653	Benzenesulfonic acid, mono-C10-36-alkyl derivatives, barium salts	93820-61-2	Intentional addition / 1,000ppm	chemical products
18654	Benzenesulfonic acid, mono-C10-36-alkyl derivatives, barium salts, overbased	93820-62-3	Intentional addition / 1,000ppm	chemical products
18655	Chromate(3-), bis[2-[[6-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(3-)]-, sodium	93820-70-3	Contains (regardless of intentional or impurities)	chemical products
18656	Chromate(3-), bis[2-[[6-[[4,6-dichloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(3-)]-, sodium	93820-71-4	Contains (regardless of intentional or impurities)	chemical products
18657	Chromate(5-), bis[5-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)]-, sodium	93820-72-5	Contains (regardless of intentional or impurities)	chemical products
18658	Cobaltate(1-), bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, hydrogen, compound with 3-(C8-18-alkylamino)butanoic acid	93820-73-6	Intentional addition / 1%	chemical products
18659	Cobaltate(5-), bis[5-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)]-, sodium	93820-74-7	Intentional addition / 1%	chemical products
18660	Copper, [29H,31H-phthalocyaninato(2-)]-N29,N30,N31,N32]-, [[3-phosphophenyl]amino]sulfonil sulfido derivatives	93820-75-8	Intentional addition / 1,000ppm	chemical products
18661	Amines, C8-18-alkyl, compounds with 9-(2-carboxyphenyl)-3,6-bis(diethylamino)xanthylium hydrogen bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]cobaltate(3-)](2:1:2:1)	93821-22-8	Intentional addition / 1%	chemical products
18662	Extract residues (coal), benzole fraction acid - An acid sludge by-product of the sulphuric acid refining of crude high temperature coal. Composed primarily of sulfuric acid and organic compounds.	93821-38-6	Contains (regardless of intentional or impurities)	chemical products
18663	Fatty acids, montan-wax, zirconium salts	93821-43-3	Contains (regardless of intentional or impurities)	chemical products
18664	Residual oils (petroleum)	93821-66-0	Contains (regardless of intentional or impurities)	chemical products
18665	3-Ethyl-2-[3-(3-ethyl-5-methoxy-3H-benzoselenazol-2-ylidene)prop-1-enyl]-5-methoxybenzoselenazolium iodide	93838-99-4	Contains (regardless of intentional or impurities)	chemical products
18666	5-Chloro-3-ethyl-2-[[1-ethyl-4-[[3-ethyl-3H-benzoselenazol-2-ylidene)ethylenylidene]-5-oxo-3-phenylimidazolidin-2-ylidene]methyl]benzothiazolium iodide	93839-00-0	Contains (regardless of intentional or impurities)	chemical products
18667	Butoxytrichenoxy-stannane	93839-24-8	Contains (regardless of intentional or impurities)	chemical products
18668	Hydrogen bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-[[methylamino]sulphonyl]benzoato(2-)]chromate(1-)]	93839-66-8	Contains (regardless of intentional or impurities)	chemical products
18669	Sodium bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-[[methylamino]sulphonyl]benzoato(2-)]chromate(1-)]	93839-67-9	Contains (regardless of intentional or impurities)	chemical products
18670	Iron 3-nitronaphthalene-1,5-disulphonate	93839-97-5	1%	chemical products
18671	Molybdenum pentakis(2-ethylhexanoate)	93840-01-8	Contains (regardless of intentional or impurities)	chemical products
18672	Tin tetra(hexanoate)	93840-03-0	Contains (regardless of intentional or impurities)	chemical products
18673	Antimony tri(hexanoate)	93840-05-2	Contains (regardless of intentional or impurities)	chemical products
18674	Antimony tris(2-ethylhexanoate)	93840-06-3	Contains (regardless of intentional or impurities)	chemical products
18675	Dibutylfluorostibine	93840-07-4	Contains (regardless of intentional or impurities)	chemical products
18676	Zirconium(4+)(Z)-octadecan-1-olate	93840-08-5	Contains (regardless of intentional or impurities)	chemical products
18677	Barium bis[3-(2-hydroxyoctyl)oxiran-2-oxanoate]	93840-72-3	Contains (regardless of intentional or impurities)	chemical products
18678	Cuprate(4-), [mu-[[[3,3'-[[3,3'-dihydroxy[[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis(5-amino-4-hydroxy-2,7-naphthalenedisulfonato(3-))]8-]]di-, tetrahydrogen, compound with 2,2,2'-[nitrioltris(2,1-ethanedioxy)]tris[ethanol]	93840-74-5	Intentional addition / 1,000ppm	chemical products
18679	2-[[Tributylstannyloxy]N-2-[[tributylstannyloxy]ethyl]ethylamine	93841-41-9	Contains (regardless of intentional or impurities)	chemical products
18680	N,N'-[[Dibutylstannylene]bis(oxyl)]bis[N-nitrosocyclohexylamine]	93841-42-0	Contains (regardless of intentional or impurities)	chemical products
18681	1,3-Dibutyl-1,1,3,3-tetrachlorodistannoxane	93841-43-1	Contains (regardless of intentional or impurities)	chemical products
18682	Leucomycin v, 9-O-[5-(dimethylamino)tetrahydro-6-methyl-2H-pyran-2-yl]-, [9(S,6R)], [1,2-ethanedioxy]bis(amino-4,1-phenylene)bis[arsenate(1:1)] (salt)	93841-79-3	Contains (regardless of intentional or impurities)	chemical products
18683	Hydrogen [3-[[4-chloro-2-hydroxy-5-methoxyphenyl]azo]-4-hydroxynaphthalene-2,7-disulphonato(4-)]chromate(1-)]	93843-04-0	Contains (regardless of intentional or impurities)	chemical products
18684	Trisodium bis[6-hydroxy-5-[[2-(hydroxy-5-nitrophenyl)azophthalene-2-sulphonato(3-)]ferrate(3-)]	93843-05-1	1%	chemical products
18685	Barium isooctanoate	93843-12-0	Contains (regardless of intentional or impurities)	chemical products
18686	Rhodium(3+) isooctanoate	93843-19-7	Contains (regardless of intentional or impurities)	chemical products
18687	Dodecyltris(lauroxy)stannane	93857-17-1	Contains (regardless of intentional or impurities)	chemical products
18688	Ethylene bis[[8-dodecyl-5,11-dioxo-1,4-dioxo-7,9-dithia-8-stannacycloundec-8-yl]thio]acetate	93857-17-2	Contains (regardless of intentional or impurities)	chemical products
18689	Disodium 4-amino-3-[[4-[[[2-amino-4-hydroxyphenyl]azo]-3,3'-dimethoxy[[1,1'-biphenyl]-4-yl]azo]-5-hydroxy-6-(phenylazo)naphthalene-2,7-disulphonate]	93857-57-9	Intentional addition	chemical products
18690	2-[2-[[3-Ethyl-5,6-dimethyl-3H-benzoselenazol-2-ylidene)methyl]but-1-enyl]-6-methoxy-5-methyl-3-(3-sulphonatopropyl)benzoselenazolium	93857-70-6	Contains (regardless of intentional or impurities)	chemical products
18691	4,6-Dichloro-1,3,2-triazin-2-ol, monoester with sodium dihydrogen orthoborate	93857-71-7	1%	chemical products
18692	3-Ethyl-2-[2-[[3-ethyl-5-methoxy-3H-benzoselenazol-2-ylidene)methyl]but-1-enyl]-5,6-dimethylbenzoselenazolium iodide	93857-89-7	Contains (regardless of intentional or impurities)	chemical products
18693	Disodium [5-[[2,4-dihydroxyphenyl]azo]-4-hydroxybenzene-1,3-disulphonato(4-)]cuprate(2-)]	93858-17-4	Intentional addition / 1,000ppm	chemical products
18694	Trihydrogen [2-[[[3-amino-5-sulfo-p-tolyl]amino]sulphonyl]-15-(sulphamoyl)-29H,31H-phthalocyanine-1,8-disulphonato(5-)]-N29,N30,N31,N32]cuprate(3-)]	93858-18-5	Intentional addition / 1,000ppm	chemical products
18695	Trisodium [22-[[[3-amino-5-sulfo-p-tolyl]amino]sulphonyl]-15-(sulphamoyl)-29H,31H-phthalocyanine-1,8-disulphonato(5-)]-N29,N30,N31,N32]cuprate(3-)]	93858-19-6	Intentional addition / 1,000ppm	chemical products
18696	Tetrahydrogen [3-[[3-chloro-2-hydroxy-5-sulphophenyl]azo]-5-[[4-chloro-6-(3-sulphoanilino)-1,3,5-triazin-2-yl]amino]-4-hydroxynaphthalene-2,7-disulphonato(6-)]cuprate(4-)]	93858-39-0	Intentional addition / 1,000ppm	chemical products
18697	Tetrahydrogen [2-[[4-chloro-6-(4-sulphoanilino)-1,3,5-triazin-2-yl]amino]-5-hydroxy-6-[[2-hydroxy-5-sulphophenyl]azophthalene-1,7-disulphonato(6-)]cuprate(4-)]	93858-40-3	Intentional addition / 1,000ppm	chemical products
18698	Trihydrogen [2-[[[6-[[4,6-dichloro-1,3,5-triazin-2-yl]methylamino]-1-hydroxy-3-sulpho-2-naphthyl]azo]-5-hydroxy-o-tolyl]azo]benzene-1,4-disulphonato(5-)]cuprate(3-)]	93858-41-4	Intentional addition / 1,000ppm	chemical products
18699	5-(Diethylamino)-2-[3-[[5-(diethylamino)-1,3-dihydro-3,3-dimethyl-1-propyl-2H-indol-2-ylidene]prop-1-enyl]-3,3-dimethyl-1-propyl-3H-indolium perchlorate	93858-43-6	1,000ppm	chemical products
18700	Bis(2-ethylhexyl mercaptoacetato-O')sulfoniumcadmium	93858-50-5	Contains (regardless of intentional or impurities)	chemical products
18701	Barium 4,4-diethoxy-2,3-dihydroxybutyl phosphate	93858-65-2	Contains (regardless of intentional or impurities)	chemical products
18702	Tris[[2-hydroxyethyl]ammonium] orthoborate	93859-15-5	1%	chemical products
18703	Trihydrogen [3-[[[4,6-dichloro-1,3,5-triazin-2-yl]amino]ethyl]amino]sulphonyl]-29H,31H-phthalocyaninetrisulphonato(5-)]-N29,N30,N31,N32]cuprate(3-)]	93861-17-7	Intentional addition / 1,000ppm	chemical products
18704	Hydrogen sodium [3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]-[[1-(2-hydroxynitrophenyl)azo]-2-naphtholato(2-)]chromate(2-)]	93891-79-3	Contains (regardless of intentional or impurities)	chemical products
18705	Nickelate(6-), [4-[[[5-[[[3,6-dichloro-4-pyridazinyl]carbonyl]amino]-2-sulphophenyl]azo]-4,5-dihydro-5-oxo-1-[2-sulfo-5-[[[trisulfo-29H,31H-phthalocyaninyl]sulfonyl]amino]phenyl]-1H-pyrazole-3-carboxylato(8-)]-N29,N30,N31,N32]-, hexasodium	93891-86-2	Contains (regardless of intentional or impurities)	chemical products
18706	Trihydrogen bis[2-[[6-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulpho-2-naphthyl]azo]benzoato(3-)]chromate(3-)]	93893-29-9	Contains (regardless of intentional or impurities)	chemical products
18707	Cuprate(3-), [mu-[[[5-[[[6-[[[2-carboxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-2-hydroxy-4-sulfo-1-naphthalenyl]azo]-3-hydroxy-7-sulfo-1-naphthalenyl]azo]-2-hydroxybenzoato(7-)]]]di-, trihydrogen	93893-72-2	Intentional addition / 1,000ppm	chemical products
18708	Dibutylbis[[1-(oxoisoundecyl)oxy]stannane	93893-96-0	Contains (regardless of intentional or impurities)	chemical products
18709	Bis(isoundecanoxy)diocetylstannane	93893-97-1	Contains (regardless of intentional or impurities)	chemical products
18710	Tributyl(isoundecanoxy)stannane	93893-98-2	Contains (regardless of intentional or impurities)	chemical products
18711	Cadmium bis(o-nonylphenolate)	93894-07-6	Contains (regardless of intentional or impurities)	chemical products
18712	Phenol, 4-nonyl-, cadmium salt	93894-08-7	Contains (regardless of intentional or impurities)	chemical products
18713	Cadmium bis[6-[[1,1,3,3-tetramethylbutyl]phenolate]	93894-09-8	Contains (regardless of intentional or impurities)	chemical products
18714	Cadmium (2)-hexadec-9-enoate	93894-10-1	Contains (regardless of intentional or impurities)	chemical products
18715	Difluoro(N-phenylacetamide-O)boron	93894-58-7	1%	chemical products
18716	1,1-Dihexylferrocene	93894-59-8	1%	chemical products
18717	Decylferrocene	93894-60-1	1%	chemical products
18718	[2-Methyl-1-oxooctyl]ferrocene	93894-61-2	1%	chemical products
18719	Sodium [2-[[2-amino-1-naphthyl]azo]-5-nitrophenolato(2-)]-[[5-[[4-chloro-2-hydroxyphenyl]azo]-6-hydroxynaphthalene-2-sulphonamidato(2-)]cobaltate(1-)]	93894-62-3	Intentional addition / 1%	chemical products
18720	Cobaltate(1-), [4-[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	93894-63-4	Intentional addition / 1%	chemical products
18721	Barium toluate	93904-98-4	Contains (regardless of intentional or impurities)	chemical products
18722	(Isocetanoato-O)(neodecanoato-O)iron	93918-11-7	1%	chemical products
18723	(Isodecanoato-O)(isononanoato-O)iron	93918-12-8	1%	chemical products
18724	(Neononanoato-O)(neodecanoato-O)manganese	93918-14-0	Contains (regardless of intentional or impurities)	chemical products
18725	Manganese(2+) neodecanoate	93918-15-1	Contains (regardless of intentional or impurities)	chemical products
18726	Manganese neonanoate	93918-16-2	Contains (regardless of intentional or impurities)	chemical products
18727	Cobalt(2+) neodecanoate	93918-17-3	Intentional addition / 1%	chemical products
18728	Cobalt(2+) neonanoate	93918-18-4	Intentional addition / 1%	chemical products
18729	(Neononanoato-O)(neodecanoato-O)cobalt	93918-19-5	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
18730	(Neononanoato-O)(neoundecanoato-O)copper	93918-22-0	Intentional addition / 1,000ppm	chemical products
18731	Copper(2+) neoundecanoate	93918-23-1	Intentional addition / 1,000ppm	chemical products
18732	Copper bis(neononanoate)	93918-24-2	Intentional addition / 1,000ppm	chemical products
18733	Butyltris[(1-oxoneodecyloxy)stannane	93918-30-0	Contains (regardless of intentional or impurities)	chemical products
18734	Ethylene bis[[[8-butyl-5,11-dioxo-1,4-dioxo-7,9-dithia-8-stannacycloundec-8-yl]thio]acetate]	93918-33-3	Contains (regardless of intentional or impurities)	chemical products
18735	Ethylene bis[[[8-octyl-5,11-dioxo-1,4-dioxo-7,9-dithia-8-stannacycloundec-8-yl]thio]acetate]	93918-35-5	Contains (regardless of intentional or impurities)	chemical products
18736	Bis(dipentylidithiocarbamato-S,S')iron	93918-67-3	1%	chemical products
18737	Bis[bis(3,3,5-trimethylhexyl)carbamodithioato-S,S']copper	93918-68-4	Intentional addition / 1,000ppm	chemical products
18738	Cerium(3+) bromate	93918-69-5	1%	chemical products
18739	Ethyl[2-[[2-ethylhexyl)oxy]-2-oxoethyl][3-oxo-3-(tetradecyloxy)propyl]sulfonium tetrafluoroborate(1-)	93918-81-1	1%	chemical products
18740	(Neononanoato-O)(neoundecanoato-O)nickel	93920-08-2	Contains (regardless of intentional or impurities)	chemical products
18741	Nickel(2+) neoundecanoate	93920-09-3	Contains (regardless of intentional or impurities)	chemical products
18742	Nickel(2+) neononanoate	93920-10-6	Contains (regardless of intentional or impurities)	chemical products
18743	Iron(II) isooctanoate	93920-15-1	1%	chemical products
18744	Iron(II) isodecanoate	93920-16-2	1%	chemical products
18745	(Isononanoato-O)(isooctanoato-O)iron	93920-17-3	1%	chemical products
18746	Cuprate(6-), [2-[[[3-[[4-chloro-6-[[4-[[4-chloro-6-[[3-sulfophenylamino]-1,3,5-triazin-2-yl]amino]-2,5-disulfophenyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulfophenyl]azo]phenylmethyl]azo]-5-sulfobenzato(8-)]-, hexahydrogen, (SP-4-3)-	93921-06-3	Intentional addition / 1,000ppm	chemical products
18747	Barium 4-dodecylphenolate	93922-04-4	Contains (regardless of intentional or impurities)	chemical products
18748	Orthoboric acid, ammonium copper salt	93924-04-0	Intentional addition / 1,000ppm	chemical products
18749	Foots oil (petroleum), acid-treated	93924-31-3	Contains (regardless of intentional or impurities)	chemical products
18750	Foots oil (petroleum), clay-treated	93924-32-4	Contains (regardless of intentional or impurities)	chemical products
18751	Gas oils, paraffinic	93924-33-5	Contains (regardless of intentional or impurities)	chemical products
18752	Humic acids, sodium salts, reaction products with basic chromium sulfate	93924-35-7	1,000ppm	chemical products
18753	Hydrocarbons, C20-50, residual oil hydrogenation vacuum distillate	93924-61-9	Contains (regardless of intentional or impurities)	chemical products
18754	Boric acid (H3BO3), reaction products with 2,2'-[[C16- 18 and C16- 18-unsaturated alkyl]imino]bis[ethanol]	93924-91-5	1%	chemical products
18755	Copper, N-(3-aminopropyl)-1,3-propanediamine nitrate complexes	93924-94-8	Intentional addition / 1,000ppm	chemical products
18756	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aluminum lake	93924-95-9	Intentional addition / 1,000ppm	chemical products
18757	Phosphoric acid, mixed butyl and hexyl diesters, barium salts	93925-26-9	Intentional addition / 1,000ppm	chemical products
18758	Silicic acid (H4SiO4), tetraethyl ester, reaction products with bis(acetyloxy)diethylstannane	93925-42-9	Intentional addition / 1,000ppm	chemical products
18759	Silicic acid (H4SiO4), tetraethyl ester, reaction products with bis(acetyloxy)diethylstannane	93925-43-0	1,000ppm	chemical products
18760	Dipotassium trichlorofluoroferrate(2-)	93926-61-5	1%	chemical products
18761	[29H,31H-Phthalocyanine-2,9,16,24-tetrahiolato(2-)-N29,N30,N31,N32]copper, tetrasodium salt	93939-67-4	Intentional addition / 1,000ppm	chemical products
18762	Tetrasodium [[[(3-amino-4-sulphophenylamino)sulphonyl]-29H,31H-phthalocyaninetrissulphonato(6-)-N29,N30,N31,N32]nickelate(4-)]	93939-76-5	Contains (regardless of intentional or impurities)	chemical products
18763	4-hydroxybis[3-[[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-N-(N-ethylcarbamoyl)-4-sulphonylbenzenesulphonamidato(2-)]cobaltate(1-)	93940-23-9	Intentional addition / 1%	chemical products
18764	Hydrogen bis[2-[[2-hydroxy-3,5-dinitrophenyl]azo]-4-methyl-1-naphtholato(2-)]chromate(1-)	93940-24-0	Contains (regardless of intentional or impurities)	chemical products
18765	Chromate(2-), [3-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]][2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, dihydrogen	93940-27-3	Contains (regardless of intentional or impurities)	chemical products
18766	[mu-Bis(tetradecan-1-olato)-mu-oxodioxidoborato(2-)]bis(nonylphenolato)dicobalt	93940-37-5	Intentional addition / 1%	chemical products
18767	Chromate(1-), [4-[4,5-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]][2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	93940-42-2	Contains (regardless of intentional or impurities)	chemical products
18768	Sodium [4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulphonamidato(2-)]][1-[[2-hydroxy-4-nitrophenyl]azo]naphthalen-2-olato(2-)]cobaltate(1-)	93940-43-3	Intentional addition / 1%	chemical products
18769	Sodium [2-[[2-amino-1-naphthyl]azo]-5-nitrophenolato(2-)]][3-[[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]azo]-4-yl]azo]-4-hydroxy-N-methylbenzenesulphonamidato(2-)]cobaltate(1-)	93940-44-4	Intentional addition / 1%	chemical products
18770	Sodium hydrogen [3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalen-1-sulphonato(3-)]][1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphtholato(2-)]cobaltate(2-)	93940-45-5	Intentional addition / 1%	chemical products
18771	Sodium [2-[[2-amino-1-naphthyl]azo]-5-nitrophenolato(2-)]][4-[[4-aminosulphonyl]phenyl]-2-[[3-chloro-2-hydroxy-5-nitrophenyl]azo]-3-oxobutylamidato(2-)]cobaltate(1-)	93940-46-6	Intentional addition / 1%	chemical products
18772	Sodium [4-[[6-amino-1-hydroxy-3-sulpho-2-naphthyl]azo]-3-hydroxy-7-nitronaphthalen-1-sulphonato(4-)]chromate(1-)	93940-68-2	Contains (regardless of intentional or impurities)	chemical products
18773	5-Oxo-L-proline, compound with strychnidin-10-one (1:1)	93940-83-1	Contains (regardless of intentional or impurities)	chemical products
18774	Bis[N-(2-hydroxyethyl)-N-methylglycinate-N,O]copper	93940-93-3	Intentional addition / 1,000ppm	chemical products
18775	(1-Imino-1H-isoindol-3-amine-N2)(methano)[29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	93940-95-5	Intentional addition / 1,000ppm	chemical products
18776	Bis[N,N-dimethylpropane-1,3-diamine-N']][2,3,16,17-tetrahydro-29H,31H-dibenzo[b]bis[1,4]dithiolo[2,3-g,2'-g']porphyrinato(2-)-N29,N30,N31,N32]cobalt	93940-96-6	Intentional addition / 1%	chemical products
18777	1,3-Dimethylbutyl 2-(2,4,5-trichlorophenoxy)acetate	93941-82-3	Intentional addition / 1,000ppm	chemical products
18778	Chromate(2-), [5-chloro-3-[[4,5-dihydro-3-methyl-5-oxo-1-[[4-[[1-oxo-2-propenyl]amino]phenyl]-1H-pyrazol-4-yl]azo]-2-hydroxybenzenesulfonato(3-)]][4-[[5-chloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, disodium	93941-95-8	Contains (regardless of intentional or impurities)	chemical products
18779	Heptasodium bis[2-[[6-[[4-chloro-6-[[4-[[2-(4-nitro-2-sulphophenyl)vinyl]-3-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulpho-2-naphthyl]azo]benzoato(5-)]chromate(7-)	93941-96-9	Contains (regardless of intentional or impurities)	chemical products
18780	Barium [2-(phosphonoxy)acrylate(3-)]argenate(2-)	93942-60-0	Contains (regardless of intentional or impurities)	chemical products
18781	28,28-Dibutyl-3,6,9,12,15,18,21,24,27-naoaxa-28-stannodotriacontan-1-ol	93951-17-8	Contains (regardless of intentional or impurities)	chemical products
18782	Copper(2+) disilver tetrametaphosphate	93951-22-5	Intentional addition / 1,000ppm	chemical products
18783	Tributyl(nonylphenoxy)stannane	93951-53-2	Contains (regardless of intentional or impurities)	chemical products
18784	Chromate(3-), bis[[5-chloro-2-(hydroxy-kappa O)-4-nitrophenyl]azo-kappa N1]-5-(hydroxy-kappa O)-1-naphthalenesulfonato(3-)]-, trisodium	93952-24-0	Contains (regardless of intentional or impurities)	chemical products
18785	1-(3-Bromopropyl)-2,4-dichlorobenzene	93962-66-4	1,000ppm	chemical products
18786	Cuprate(5-), [2-[[[4-chloro-6-[[2-methyl-5-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]-6-[[[2,5-disulphophenyl]azo]-2-hydroxy-5-methylphenyl]azo]-5-hydroxy-1,7-naphthalenedisulfonato(7-)]-, pentahydrogen	93962-86-8	Intentional addition / 1,000ppm	chemical products
18787	Dihydrogen [mu-[[2,2'-[vinylene]bis[[3-sulpho-4,1-phenylene]imino(6-chloro-1,3,5-triazine-4,2-diy)imino(1-hydroxy-3-sulphonaphthalene-6,2-diyl)azo]bis[benzoato(1-)]][8-]]]dichromate(2-)	93962-87-9	Contains (regardless of intentional or impurities)	chemical products
18788	Hydrogen [2-[[6-[[4-chloro-6-[[3-sulphoamino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulpho-2-naphthyl]azo]benzoato(4-)]chromate(1-)	93962-90-4	Contains (regardless of intentional or impurities)	chemical products
18789	Copper(2+) isotridecanoate	93963-95-0	Intentional addition / 1,000ppm	chemical products
18790	Iron(3+) isotridecanoate	93963-96-1	1%	chemical products
18791	Rhodium tris(isononanoate)	93963-97-2	Contains (regardless of intentional or impurities)	chemical products
18792	[mu-Bis(octadecan-1-olato)-mu-oxodioxidoborato(2-)]bis(nonylphenolato)dicobalt	93964-01-3	Intentional addition / 1%	chemical products
18793	Bis(nonylphenolato)[mu-oxodioxobis(trimethylhexan-1-olato)diborato(2-)]dicobalt	93964-02-4	Intentional addition / 1%	chemical products
18794	[mu-Bis(2-ethylhexan-1-olato)-mu-oxodioxidoborato(2-)]bis(nonylphenolato)dicobalt	93964-03-5	Intentional addition / 1%	chemical products
18795	3-Ethyl-2-[[1-ethyl-4-[[3-ethyl-3H-benzoselenazol-2-ylidene]ethylidene]-5-oxo-3-phenylimidazolidin-2-ylidene]methyl]benzoselenazolium iodide	93964-28-4	Contains (regardless of intentional or impurities)	chemical products
18796	Trihydrogen [29H,31H-phthalocyaninetrissulphonato(5-)-N29,N30,N31,N32]cuprate(2-), compound with 1-butoxy-3-[[1,1,3,3-tetramethylbutyl]amino]propan-2-ol (1:3)	93964-38-6	Intentional addition / 1,000ppm	chemical products
18797	Dihydrogen [29H,31H-phthalocyaninetrissulphonato(4-)-N29,N30,N31,N32]cuprate(2-), compound with 1-butoxy-3-[[1,1,3,3-tetramethylbutyl]amino]propan-2-ol (1:2)	93964-39-7	Intentional addition / 1,000ppm	chemical products
18798	Sodium 2-[[2-amino-6-[[4-[[3-carboxy-4-hydroxyphenyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]-5-hydroxy-7-sulpho-1-naphthyl]azo]-5-nitrobenzoate	93964-42-2	Intentional addition	chemical products
18799	3,3'-[[3,3'-Dimethoxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[5-amino-4-hydroxynaphthalene-2,7-disulphonic] acid, ammonium potassium sodium salt	93964-43-3	Intentional addition	chemical products
18800	Orthoboric acid, compound with piperazine-1,4-dithanol	93964-49-9	1%	chemical products
18801	Boric acid (H3BO3), compound with 2-amino-2-methyl-1-propanol	93964-50-2	1%	chemical products
18802	Orthoboric acid, compound with 2-piperazin-1-ylethylamine	93964-51-3	1%	chemical products
18803	Disodium hydrogen 5-[[4-[[8-amino-1-hydroxy-3,6-disulphonato-2-naphthyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]salicylate	93964-58-0	Intentional addition	chemical products
18804	Trisodium hydrogen 5-[[4-[[8-[[2,4-dihydroxy-3-[[2-methoxy-5-sulphonatophenyl]azo]phenyl]azo]-1-hydroxy-3,6-disulphonato-2-naphthyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]salicylate	93964-62-6	Intentional addition	chemical products
18805	Tetrasodium 5-[[4-[[8-[[2,4-dihydroxy-3-[[2-methoxy-5-sulphonatophenyl]azo]phenyl]azo]-1-hydroxy-3,6-disulphonato-2-naphthyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]salicylate	93964-63-7	Intentional addition	chemical products
18806	Trisodium 5-[[4-[[8-amino-1-hydroxy-3,6-disulphonato-2-naphthyl]azo]-3,3'-dimethoxy[1,1'-biphenyl]-4-yl]azo]salicylate	93964-64-8	Intentional addition	chemical products
18807	Sodium bis[2-[[1-(2-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]benzoato(2-)]cobaltate(1-)	93964-86-4	Intentional addition / 1%	chemical products
18808	Trihydrogen bis[6-hydroxy-5-[[2-hydroxy-5-nitrophenyl]azo]naphthalene-2-sulphonato(3-)]ferrate(3-), compound with N-cyclohexylamine (1:3)	93964-87-5	1%	chemical products
18809	Trihydrogen bis[4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzene-1-sulphonato(3-)]chromate(3-), compound with dicyclohexylamine (1:3)	93964-92-2	Contains (regardless of intentional or impurities)	chemical products
18810	Tris[9-(2-carboxyphenyl)-3,6-bis(diethylamino)xanthylum] bis[4-[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]chromate(3-)	93964-93-3	Contains (regardless of intentional or impurities)	chemical products
18811	Chromate(3-), bis[4-[4,5-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, trisodium	93964-94-4	Contains (regardless of intentional or impurities)	chemical products
18812	Trihydrogen tris[5,6-dihydro-5-(hydroxymino)-6-oxonaphthalene-2-sulphonato(2-)-O5,O6]ferrate(3-), compound with N,N'-di-o-tolylguanidine (1:3)	93964-96-6	1%	chemical products
18813	Pentasodium bis[4-[[6-[[4-chloro-6-(2-ethoxyethoxy)-1,3,5-triazin-2-yl]amino]-1-hydroxy-2-naphthyl-3-sulpho]azo]-3-hydroxy-7-nitronaphthalene-1-sulphonato(4-)]cobaltate(5-)	93964-97-7	Intentional addition / 1%	chemical products
18814	Bis(isononanoxyloxy)diethylstannane	93965-21-0	Contains (regardless of intentional or impurities)	chemical products
18815	Tributyl(isononanoxyloxy)stannane	93965-22-1	Contains (regardless of intentional or impurities)	chemical products
18816	Barium isodecanoate	93965-23-2	Contains (regardless of intentional or impurities)	chemical products
18817	Cadmium isodecanoate	93965-24-3	Contains (regardless of intentional or impurities)	chemical products
18818	Zirconium(2+) isodecanoate	93965-25-4	Contains (regardless of intentional or impurities)	chemical products
18819	Bis(isodecanoxyloxy)diethylstannane	93965-26-5	Contains (regardless of intentional or impurities)	chemical products
18820	Tributyl(isodecanoxyloxy)stannane	93965-27-6	Contains (regardless of intentional or impurities)	chemical products
18821	Barium isoundecanoate	93965-28-7	Contains (regardless of intentional or impurities)	chemical products
18822	Cadmium bis(isoundecanoate)	93965-30-1	Contains (regardless of intentional or impurities)	chemical products
18823	Zirconium bis(isoundecanoate)	93965-33-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
18824	Cobalt bis(isoundecanoate)	93965-34-5	Intentional addition / 1%	chemical products
18825	Barium 3,3'-diethoxy-2'-hydroxypropyl phosphate	93965-35-6	Contains (regardless of intentional or impurities)	chemical products
18826	Cuprate(4-), [mu.-[[[3,3'-[[3,3'-dihydroxy]1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[4-hydroxy-2,7-naphthalenedisulfonato]](6-)]di-, tetrasodium	93966-92-8	Intentional addition / 1,000ppm	chemical products
18827	[N-[3-(Diethylamino)propyl]-29H,31H-phthalocyaninesulfonamidato(2-)-N29,N30,N31,N32]copper	93971-95-0	Contains (regardless of intentional or impurities)	chemical products
18828	2-(4,5-Dibromo-3,6-dihydroxyxanthhen-9-yl)benzoic acid, zirconium salt	93980-88-2	Contains (regardless of intentional or impurities)	chemical products
18829	Tetrasodium [5-[[6-[[4-(4-amino-6-chloro-1,3,5-triazin-2-yl)amino]-3-sulphophenyl]amino]-1-hydroxy-3-sulpho-2-naphthyl]azo]-4-hydroxybenzene-1,3-disulphonato(2-)]cuprate(4-)	93981-05-6	Intentional addition / 1,000ppm	chemical products
18830	[Ethane-1,2-diolato(2-)-O,O']oxalopentane-2,4-dionato-O,O']vanadium	93981-06-7	Intentional addition / 1%	chemical products
18831	Iron bis(2-ethylhexanoate)	93981-08-9	1%	chemical products
18832	Tris(2-hydroxy-5-tert-nonylacetoephene oximate)iron	93981-34-1	1%	chemical products
18833	Iron bis(neonanoate)	93981-36-3	1%	chemical products
18834	Iron(2+) neoundecanoate	93981-37-4	1%	chemical products
18835	(2-Ethylhexanoato-O)(isooctanoato-O)iron	93981-41-0	1%	chemical products
18836	(2-Ethylhexanoato-O)(isododecanoato-O)iron	93981-42-1	1%	chemical products
18837	(2-Ethylhexanoato-O)(neodecanoato-O)iron	93981-43-2	1%	chemical products
18838	Butyltris[[1-oxoisooctadecyl]oxy]stannane	93981-44-3	Contains (regardless of intentional or impurities)	chemical products
18839	(Neononanoato-O)(neoundecanoato-O)iron	93981-45-4	1%	chemical products
18840	(2-Ethylhexanoato-O)(isononanoato-O)iron	93981-46-5	1%	chemical products
18841	(Isodecanoato-O)(neodecanoato-O)iron	93981-47-6	1%	chemical products
18842	Trisodium [4-hydroxy-3-[[2-hydroxy-5-sulphophenyl]azo]-5-[[2,6,6-trichloro-4-pyrimidinyl]amino]naphthalene-2,7-disulphonato(5-)]cuprate(3-)	93982-82-2	Intentional addition / 1,000ppm	chemical products
18843	[1R-(1.alpha.,4a.beta.,10a.alpha.)-(1,2,3,4,4a,9,10,10a-Octahydro-7-isopropyl-1,4a-dimethylphenanthren-1-yl)methylammonium tetrafluoroborate(1-)]	93982-94-6	1%	chemical products
18844	Cobaltate(1-), [4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-(1-methylethyl)benzenesulfonamidato(2-)]-[4-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]-N-phenylbenzenesulfonamidato(2-)]-, sodium	93983-06-3	Intentional addition / 1%	chemical products
18845	Cadmium dimethylhexanoate	93983-65-4	Contains (regardless of intentional or impurities)	chemical products
18846	Dimethylhexanoic acid, cobalt salt	93983-67-6	Intentional addition / 1%	chemical products
18847	Dimethylhexanoic acid, nickel salt	93983-68-7	Contains (regardless of intentional or impurities)	chemical products
18848	Dimethylhexanoic acid, zirconium salt	93983-70-1	Contains (regardless of intentional or impurities)	chemical products
18849	Bis(S)-[nicotine] citrate	94006-00-5	Contains (regardless of intentional or impurities)	chemical products
18850	Barium(2+) 4,4'-isopropylidenebisphenolate	94006-29-8	Contains (regardless of intentional or impurities)	chemical products
18851	Orthoboric acid, compound with 1,1,1'-nitrioltriopropan-2-ol	94006-32-3	1%	chemical products
18852	Chromate(1-), bis[1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]-, ammonium	94016-43-0	Contains (regardless of intentional or impurities)	chemical products
18853	Copper(II) octahydro-4,7-methano-1H-indenecarboxylate	94020-83-4	Intentional addition / 1,000ppm	chemical products
18854	(Isononanoato-O)(neodecanoato-O)iron	94020-86-7	1%	chemical products
18855	(Isodecanoato-O)(isooctanoato-O)iron	94020-90-3	1%	chemical products
18856	[N,N,N',N',N'',N''-Hexamethyl-29H,31H-phthalocyaninetrimethylaminato(2-)-N29,N30,N31,N32]copper triacetate	94020-92-5	Intentional addition / 1,000ppm	chemical products
18857	5-[[4-[[[2,4-Dihydroxy-3-[[2-methoxy-5-sulphophenyl]azo]phenyl]azo]-1-hydroxy-3,6-disulpho-2-naphthyl]azo]-3,3'-dimethoxy]1,1'-biphenyl]-4-yl]azo]sacilic acid, sodium salt	94021-36-0	Intentional addition	chemical products
18858	Cuprate(4-), [3-[[[8-[[[4-bis[2-[[2-chloroethyl]sulfonyl]ethyl]amino]-6-chloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-3,6-disulfo-2-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)]-, tetrasodium	94021-49-5	Intentional addition / 1,000ppm	chemical products
18859	Sodium [4-amino-5-hydroxy-6-[[2-hydroxy-3,5-dinitrophenyl]azo]naphthalene-1-sulphonato(3-)]hydroxychromate(1-)	94021-50-8	Contains (regardless of intentional or impurities)	chemical products
18860	Sodium [4-[[2,4-dihydroxy-5-[[2-hydroxy-3,5-dinitrophenyl]azo]phenyl]azo]benzene-1-sulphonato(3-)]ferate(1-)	94021-51-9	1%	chemical products
18861	Tetrasodium hydrogen bis[4-[[[6-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulpho-2-naphthyl]azo]-3-hydroxy-7-nitronaphthalene-1-sulphonato(4-)]chromate(5-)]	94021-52-0	Contains (regardless of intentional or impurities)	chemical products
18862	Tributyl(ethyl 3-oxobutyrato-O)O3tin	94021-54-2	Contains (regardless of intentional or impurities)	chemical products
18863	Pentahydrogen bis[3-hydroxy-4-[[2-hydroxy-6-sulpho-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(4-)]chromate(3-)]	94021-55-3	Contains (regardless of intentional or impurities)	chemical products
18864	Pentassodium bis[3-hydroxy-4-[[2-hydroxy-6-sulpho-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(4-)]chromate(5-)]	94021-56-4	Contains (regardless of intentional or impurities)	chemical products
18865	Trisodium [III[3-[[[2,6-dichloropyridazin-4-yl]carbonyl]amino]-5-sulpho-p-oly]amino]sulphonylsulphamoyl-29H,21H-phthalocyaninedisulphonato(5-)-N29,N30,N31,N32]cuprate(3-)	94021-57-5	Intentional addition / 1,000ppm	chemical products
18866	[29H,31H-Phthalocyaninediyl dithiocyanato(2-)-N29,N30,N31,N32]cobalt	94021-58-6	Intentional addition / 1%	chemical products
18867	2-(2,4,5,7-Tetrabromo-3,6-dihydroxyxanthhen-9-yl)-3,4,5,6-tetrachlorobenzoic acid, zirconium salt	94021-88-2	Contains (regardless of intentional or impurities)	chemical products
18868	2-(2,4,5,7-Tetrabromo-3,6-dihydroxyxanthhen-9-yl)benzoic acid, zirconium salt	94021-89-3	Contains (regardless of intentional or impurities)	chemical products
18869	Tetraethyltellurium	94022-10-3	Contains (regardless of intentional or impurities)	chemical products
18870	2-Chloro-4-(dibenzylamino)-5-(2-hydroxyethoxy)benzenediazonium chloride, compound with tin dichloride	94022-46-5	Contains (regardless of intentional or impurities)	chemical products
18871	Disodium pentabromorhodate	94022-49-8	Contains (regardless of intentional or impurities)	chemical products
18872	Cuprate(8-), [mu.-[[[4,4'-[[1,2-ethenediyl]bis(3-sulfo-4,1-phenylene)imino(6-chloro-1,3,5-triazine-4,2-diy)imino]]bis[6-[[3-chloro-2-hydroxy-5-sulphophenyl]azo]-5-hydroxy-2,7-naphthalenedisulfonato]](12-)]di-, octahydrogen	94022-93-2	Intentional addition / 1,000ppm	chemical products
18873	Zirconium D-gluconate	94023-24-2	Contains (regardless of intentional or impurities)	chemical products
18874	Bis(2-ethylhexyl) o.o'-(dibutylstannylene)bis(oxy)carboxylate) dibenzoate	94023-65-1	Contains (regardless of intentional or impurities)	chemical products
18875	D-Mannose, 6-(dihydrogen phosphate), barium salt (1:1)	94030-87-2	Contains (regardless of intentional or impurities)	chemical products
18876	C.I. Basic Blue 100	94031-29-5	Intentional addition / 1,000ppm	chemical products
18877	Tributyl(p-tert-butylbenzoyl)oxy]stannane	94042-69-0	Contains (regardless of intentional or impurities)	chemical products
18878	Zirconium tetra(dimethylhexanoate)	94086-48-3	Contains (regardless of intentional or impurities)	chemical products
18879	Cobalt bis(dimethylhexanoate)	94086-50-7	Intentional addition / 1%	chemical products
18880	Copper bis(dimethylhexanoate)	94086-51-8	Intentional addition / 1,000ppm	chemical products
18881	Copper tetrapropylsuccinate	94086-58-5	Intentional addition / 1,000ppm	chemical products
18882	Orthoboric acid, compound with 2-aminobutan-1-ol	94086-71-2	1%	chemical products
18883	(Z)-1-Bromohept-3-ene	94088-35-4	1,000ppm	chemical products
18884	2-Fluoro-6-methoxybenzonitrile	94088-46-7	Intentional addition	chemical products
18885	Benzyltris(dimethylaminato)phosphorus(1+) tetrafluoroborate(1-)	94088-77-4	1%	chemical products
18886	Titanium tetraboridesilicide	94094-28-7	1%	chemical products
18887	Tungsten tetraboridecarbide	94094-29-8	1%	chemical products
18888	Carbide molybdenum trisilicide	94094-30-1	1%	chemical products
18889	Titanium tetraboridecarbide	94094-31-2	1%	chemical products
18890	Boric acid (H3BO3), reaction products with ethanolamine	94095-04-2	1%	chemical products
18891	Boric acid (H3BO3), reaction products with 1-piperazineethanamine	94095-05-3	1%	chemical products
18892	Stannane, tributyl-, mono(resin acyloxy) derivatives	94095-56-4	Contains (regardless of intentional or impurities)	chemical products
18893	Tranbane bis[4-[[4-chloro-3-sulphonatophenyl]azo]-3-hydroxynaphthalene-2,7-disulphonate]	94109-21-4	Contains (regardless of intentional or impurities)	chemical products
18894	12,12-Dibutyl-4,4,6,6,8,8,10,10-octaethoxy-3,5,7,9,11-pentaaxa-4,6,8,10-tetrasila-12-stannahexadecane	94109-28-1	Contains (regardless of intentional or impurities)	chemical products
18895	7-[[Tributylstannyloxy]tetrasiloxane-1,1,1,3,3,5,5,7,7-nonol	94109-31-6	Contains (regardless of intentional or impurities)	chemical products
18896	Tris(bicyclo[2.2.1]hept-2-ylmethyl) orthoborate	94109-34-9	1%	chemical products
18897	(Diphenylarsino)dimethylgallium	94113-53-8	Contains (regardless of intentional or impurities)	chemical products
18898	(Diphenylphosphino)dimethylindium	94113-54-9	1%	chemical products
18899	Gasoline, pyrolysis, hydrogenated	94114-03-1	Contains (regardless of intentional or impurities)	chemical products
18900	Pitch, coal tar, high-temperature, secondary	94114-13-3	Contains (regardless of intentional or impurities)	chemical products
18901	Tar acids, brown-coal, C2-alkylphenol fraction	94114-29-1	Contains (regardless of intentional or impurities)	chemical products
18902	Tar oils, brown-coal	94114-40-6	Contains (regardless of intentional or impurities)	chemical products
18903	Wastes, copper-manufacturing, calcium hydroxide-treated	94114-41-7	Intentional addition / 1,000ppm	chemical products
18904	Wastes, magnet-manufacturing, metallic - Grinding material residues obtained during the production of magnets, consists primarily of aluminum, cobalt, copper, iron, nickel, titanium and rare earth metals.	94114-42-8	Contains (regardless of intentional or impurities)	chemical products
18905	Residues (coal), liquid solvent extraction	94114-46-2	Contains (regardless of intentional or impurities)	chemical products
18906	Coal liquids, liquid solvent extraction solution	94114-47-3	Contains (regardless of intentional or impurities)	chemical products
18907	Coal liquids, liquid solvent extraction	94114-48-4	Contains (regardless of intentional or impurities)	chemical products
18908	Distillates (coal), liquid solvent extraction primary	94114-52-0	Contains (regardless of intentional or impurities)	chemical products
18909	Distillates (coal), solvent extraction, hydrocracked	94114-53-1	Contains (regardless of intentional or impurities)	chemical products
18910	Naphtha (coal), solvent extraction hydrocracked	94114-54-2	Contains (regardless of intentional or impurities)	chemical products
18911	Gasoline, coal solvent extraction, hydrocracked naphtha	94114-55-3	Contains (regardless of intentional or impurities)	chemical products
18912	Distillates (coal), solvent extraction hydrocracked middle	94114-56-4	Contains (regardless of intentional or impurities)	chemical products
18913	Distillates (coal), solvent extraction hydrocracked hydrogenated middle	94114-57-5	Contains (regardless of intentional or impurities)	chemical products
18914	Sodium 2(or 4)-dodecylbenzenesulphonate	94131-36-9	1%	chemical products
18915	1,2-Bis(isopropyl)naphthalene	94133-79-6	Intentional addition / 1%	chemical products
18916	1,7-Diisopropyl naphthalene	94133-80-9	Intentional addition / 1%	chemical products
18917	2,3-Diisopropyl naphthalene	94133-81-0	Intentional addition / 1%	chemical products
18918	3,5,5-Trimethylhexyl nitrite	94134-31-3	Intentional addition / 1,000ppm	chemical products
18919	5,5-Dibutyl-3,3,7,7-tetramethoxy-2,4,6,8-tetraoxa-3,7-disila-5-stannanonane	94134-56-2	Contains (regardless of intentional or impurities)	chemical products
18920	Tris[(8.alpha.)-6-methoxycinchanon-9(R)-ol] arsenite	94138-87-1	Contains (regardless of intentional or impurities)	chemical products
18921	3-Ethyl-5,6-dimethyl-2-[[[5-methyl-3-(2-methyl-3-sulphonatopropyl)-3H-benzoselenazol-2-ylidene)methyl]but-1-enyl]benzothiazolium	94158-30-2	Contains (regardless of intentional or impurities)	chemical products
18922	3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14,15,15,16,16,17,17,18,18-Dotriacontafluoro-17-(trifluoromethyl)octadecyl acrylate	94158-63-1	1,000ppm	chemical products
18923	3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14,15,15,16,16,16-Octacosafuoro-15-(trifluoromethyl)hexadecyl methacrylate	94158-64-2	1,000ppm	chemical products
18924	3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,12,12,13,13,14,14,15,15,16,16,17,17,18,18-Dotriacontafuoro-17-(trifluoromethyl)octadecyl methacrylate	94158-65-3	1,000ppm	chemical products
18925	Orthoboric acid, compound with 1,3,5-triazine-2,4,6-triamine (1:1)	94159-20-3	1%	chemical products
18926	Bis[3,5-dihydroxybenzoato-O]-(mu.)-mu.-oxodocopper	94159-25-8	Intentional addition / 1,000ppm	chemical products
18927	2-[[[3-Ethyl-6-methoxy-5-methyl-3H-benzoselenazol-2-ylidene)methyl]-1-butenyl]-1-(3-sulphonatopropyl)naphth[1,2-d]oxazolium	94166-38-8	Contains (regardless of intentional or impurities)	chemical products
18928	2-[[[3-Methoxy-5-methyl-3-(3-sulphonatopropyl)-3H-benzoselenazol-2-ylidene]-2-(methylthio)-1-propenyl]-1-methylnaphtho[1,2-d]thiazolium	94166-40-2	Contains (regardless of intentional or impurities)	chemical products
18929	Diphenyl hydrogen orthoborate	94200-67-6	1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
18930	2-[[[5,6-Dimethyl-3-(4-sulphonatobutyl)-3H-benzoselenazol-2-ylidene]methyl]-1-butenyl]-1-ethylnaphtho[1,2-d]thiazolium	94213-13-5	Contains (regardless of intentional or impurities)	chemical products
18931	(4-Aminophenyl)arsonic acid, compound with piperazine (1:1)	94232-26-5	Contains (regardless of intentional or impurities)	chemical products
18932	Ammonium triiodo(1+) disulphite	94232-38-9	Intentional addition	chemical products
18933	(2-Ethylhexanoato-O)dioxovanadium	94232-42-5	Intentional addition / 1%	chemical products
18934	Bis(2-ethylhexanoato-O)dioxomolybdenum	94232-43-6	Contains (regardless of intentional or impurities)	chemical products
18935	Cobalt(2+) dnickel(2+) bis(2-hydroxypropane-1,2,3-tricarboxylate)	94232-44-7	Contains (regardless of intentional or impurities)	chemical products
18936	Dichromic acid, potassium sodium salt	94232-45-8	Contains (regardless of intentional or impurities)	chemical products
18937	Cadmium tetrapentyl bis(phosphate)	94232-49-2	Contains (regardless of intentional or impurities)	chemical products
18938	Benzylbis(dimethylamino)phenylphosphorus(1+) tetrafluoroborate(1-)	94232-62-9	1%	chemical products
18939	Cobalt(2+) nickel(2+) bis(2-hydroxypropane-1,2,3-tricarboxylate)	94232-84-5	Contains (regardless of intentional or impurities)	chemical products
18940	Havakis(acetone)cobalt(2+) bis(tricarboxylate)tri-mu-carboxylhexacarbonyltricobaltate/ferrate(1-) (3co-co)(3co-fe)	94232-89-0	Intentional addition / 1%	chemical products
18941	Tris[[1-oxoacetate]anthranilate-O1,O2]chromium	94232-91-4	1,000ppm	chemical products
18942	Tris[[1-oxoacetate-9-en-1-yl]anthranilate-O1,O2]chromium	94232-92-5	1,000ppm	chemical products
18943	Hydrogen [4-hydroxy-3-[[2-hydroxy-1-naphthyl]azo]-naphthalene-1,5-disulphonato(4-)]chromate(1-)	94232-93-6	Contains (regardless of intentional or impurities)	chemical products
18944	Sodium bis[[2-(2-hydroxy-5-methoxyphenyl)azo]-4,6-dinitrophenolato(2-)]chromate(1-)	94232-94-7	Contains (regardless of intentional or impurities)	chemical products
18945	Chromate(1-), bis[[2-(2-hydroxy-5-nitrophenyl)azo]-3-oxo-N-phenylbutanamidato(2-)]-, sodium	94232-95-8	Contains (regardless of intentional or impurities)	chemical products
18946	Sodium bis[[2-(5-chloro-2-hydroxyphenyl)azo]-4-methyl-1-naphthalato(2-)]chromate(1-)	94232-96-9	Contains (regardless of intentional or impurities)	chemical products
18947	Sodium [N-(4-aminosulphonylphenyl)-2-[[2-(2-hydroxy-5-nitrophenyl)azo]-3-oxobutyramidato(2-)]][2-[[2-(2-hydroxy-5-nitrophenyl)azo]-3-oxo-N-phenylbutyramidato(2-)]cobaltate(1-)]	94232-97-0	Intentional addition / 1%	chemical products
18948	Chromate(2-), [3-hydroxy-4-[[2-(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulphonato(3-)]][2-[[2-(2-hydroxy-5-nitrophenyl)azo]-4-methyl-1-naphthalenolato(2-)]-, disodium	94232-98-1	Contains (regardless of intentional or impurities)	chemical products
18949	Tris(ethane-1,2-diamine-N,N)cobalt(3+) tris(ethane-1,2-diamine-N,N)rhodium hexachloride	94232-99-2	Contains (regardless of intentional or impurities)	chemical products
18950	Bis[N-[[3.alpha.5.beta.7.alpha.12.alpha.]]-3,7,12-trihydroxy-24-oxocholan-24-yl]glycinato]copper	94233-01-9	Intentional addition / 1,000ppm	chemical products
18951	Diammonium [[N,N-ethylenebis[N-(carboxymethyl)glycinato]](4-)-N,N,O,O,ON,ON]manganate(2-)	94233-07-5	Contains (regardless of intentional or impurities)	chemical products
18952	Diammonium [[N,N-ethylenebis[N-(carboxymethyl)glycinato]](4-)-N,N,O,O,ON,ON]cobaltate(2-)	94233-08-6	Intentional addition / 1%	chemical products
18953	Sodium [N-[[2-bis(carboxymethyl)amino]ethyl]-N-(2-hydroxyethyl)glycinato(3-)]cobaltate(1-)	94233-10-0	Intentional addition / 1%	chemical products
18954	Disodium [4-amino-5-hydroxy-6-[[2-(2-hydroxy-5-nitrophenyl)azo]naphthalene-1,7-disulphonato(4-)]][2-[[2-(2-hydroxy-5-sulphamoylphenyl)azo]-3-oxo-N-phenylbutyramidato]chromate(2-)]	94233-12-2	Contains (regardless of intentional or impurities)	chemical products
18955	Disodium [3-hydroxy-4-[[2-(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]][methyl 7-hydroxy-8-[[2-(2-hydroxy-5-nitrophenyl)azo]-1-naphthyl]carbamato(2-)]chromate(2-)]	94233-13-3	Contains (regardless of intentional or impurities)	chemical products
18956	Disodium [3-hydroxy-4-[[2-(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]][methyl 7-hydroxy-8-[[2-(2-hydroxy-4-nitrophenyl)azo]-1-naphthyl]carbamato(2-)]chromate(2-)]	94233-14-4	Contains (regardless of intentional or impurities)	chemical products
18957	Disodium [3-hydroxy-4-[[2-(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]][methyl 7-hydroxy-8-[[2-(2-hydroxy-3,5-dinitrophenyl)azo]-1-naphthyl]carbamato(2-)]chromate(2-)]	94233-15-5	Contains (regardless of intentional or impurities)	chemical products
18958	Dihydrogen [3-hydroxy-4-[[2-(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]][methyl 7-hydroxy-8-[[2-(2-hydroxy-4-nitrophenyl)azo]-1-naphthyl]carbamato(2-)]chromate(2-)]	94233-16-6	Contains (regardless of intentional or impurities)	chemical products
18959	Dihydrogen [3-hydroxy-4-[[2-(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]][methyl 7-hydroxy-8-[[2-(2-hydroxy-3,5-dinitrophenyl)azo]-1-naphthyl]carbamato(2-)]chromate(2-)]	94233-17-7	Contains (regardless of intentional or impurities)	chemical products
18960	Tris(6-methylheptane-2,4-dionato-O,O)cobalt	94233-18-8	Intentional addition / 1%	chemical products
18961	Tris(6-methylheptane-2,6-dionato-O,O)indium	94233-20-2	1%	chemical products
18962	Bis(6-methylheptane-2,4-dionato-O,O)iron	94233-22-4	1%	chemical products
18963	Tris(6-methylheptane-2,4-dionato-O,O)vanadium	94233-23-5	Intentional addition / 1%	chemical products
18964	Bis(6-methylheptane-2,4-dionato-O,O)dioxovanadium	94233-24-6	Intentional addition / 1,000ppm	chemical products
18965	Bis(2-hydroxybenzoato-O1,O2)-mu-oxodicopper	94233-32-6	Intentional addition / 1,000ppm	chemical products
18966	Trihydrogen [mu-4-[[[4-[[6-benzamido-1-hydroxy-3-sulpho-2-naphthyl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-3-hydroxynaphthalene-2,7-disulphonato(7-)]dicuprate(3-)]	94233-35-9	Intentional addition / 1,000ppm	chemical products
18967	Trihydrogen [mu-8-[[[6-benzamido-1-hydroxy-3-sulpho-2-naphthyl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-7-hydroxynaphthalene-1,3-disulphonato(7-)]dicuprate(3-)]	94233-36-0	Intentional addition / 1,000ppm	chemical products
18968	Dihydrogen [mu-[[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[7-benzamido-4-hydroxynaphthalene-2-sulphonato]](6-)]dicuprate(2-)]	94233-37-1	Intentional addition / 1,000ppm	chemical products
18969	Disodium [mu-[[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[7-benzamido-4-hydroxynaphthalene-2-sulphonato]](6-)]dicuprate(2-)]	94233-38-2	Intentional addition / 1,000ppm	chemical products
18970	(Diethylamine)dimethylindium	94236-82-5	1%	chemical products
18971	(Diisopropylamine)dimethylindium	94236-83-6	1%	chemical products
18972	Diocetate 4,4'-[[[dibutylstannylene]bis(oxo)]bis[4-oxocrotonate]	94237-39-5	Contains (regardless of intentional or impurities)	chemical products
18973	Tetrahydrogen [mu-[[[3,3'-[[3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl]bis(azo)]bis[4,5-dihydroxynaphthalene-2,7-disulphonato]](8-)]dicuprate(4-)]	94246-65-8	Intentional addition / 1,000ppm	chemical products
18974	Nitrobenzenesulphonato(3-)]][2-[[2-(2-hydroxy-5-nitrophenyl)imino]methyl]-4-(phenylazo)phenolato(2-)]chromate(2-)]	94246-67-0	Contains (regardless of intentional or impurities)	chemical products
18975	Sodium bis[N-(2-chlorophenyl)-2-[[2-hydroxy-5-mesy]phenyl]azo]-3-oxobutyramidato(2-)]cobaltate(1-)]	94246-68-1	Intentional addition / 1%	chemical products
18976	Sodium bis[2-[[2-hydroxy-5-[[isopropylamino]sulphonyl]phenyl]azo]-3-oxo-N-phenylbutyramidato(2-)]cobaltate(1-)]	94246-69-2	Intentional addition / 1%	chemical products
18977	Sodium [7-amino-8-[[2-(2-hydroxy-4-nitrophenyl)azo]-N-methylnaphthalene-2-sulphonamidato(2-)]][2-[[2-hydroxy-5-[[isopropylamino]sulphonyl]phenyl]azo]-3-oxo-N-phenylbutyramidato(2-)]cobaltate(1-)]	94246-70-5	Intentional addition / 1%	chemical products
18978	Sodium bis[7-amino-8-[[2-(2-hydroxy-4-nitrophenyl)azo]-N-methylnaphthalene-2-sulphonamidato(2-)]cobaltate(1-)]	94246-71-6	Intentional addition / 1%	chemical products
18979	Bis(2,6-diacetyl-7,9-dihydroxy-8,9b-dimethyl-1,3(2H,9bH)-dibenzofuranidionato-O2,O3)copper	94246-73-8	Intentional addition / 1,000ppm	chemical products
18980	Tripotassium [[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-(2-hydroxy-4-sulpho-1-naphthyl)azo]naphthalene-2,7-disulphonato(5-)]]cuprate(3-)]	94246-75-0	Intentional addition / 1,000ppm	chemical products
18981	Sodium [6-anilino-4-hydroxy-3-[[2-(2-hydroxy-5-sulphamoylphenyl)azo]naphthalene-2-sulphonato(3-)]]cuprate(1-)]	94246-76-1	Intentional addition / 1,000ppm	chemical products
18982	Cobalt (2-ethylhexanoato-O)(isooctanoato-O)-	94246-88-5	Intentional addition / 1%	chemical products
18983	(2-Ethylhexanoato-O)(isononanoato-O)cobalt	94246-89-6	Intentional addition / 1%	chemical products
18984	Dibutylbis[[1-oxo-tert-decyl]oxy]stannane	94246-99-8	Contains (regardless of intentional or impurities)	chemical products
18985	Cadmium isocetyl phthalate (1:2:2)	94247-16-2	Contains (regardless of intentional or impurities)	chemical products
18986	(2-Ethylhexanoato-O)(isononanoato-O)manganese	94247-29-7	Contains (regardless of intentional or impurities)	chemical products
18987	(2-Ethylhexanoato-O)(neodecanoato-O)manganese	94247-30-0	Contains (regardless of intentional or impurities)	chemical products
18988	(2-Ethylhexanoato-O)(isodecanoato-O)manganese	94247-31-1	Contains (regardless of intentional or impurities)	chemical products
18989	Hydrogen bis[[2-(2-ethylhexylamino)sulphonyl]-2,9H,31H-phthalocyaninesulphonato(3-)-N29,N30,N31,N32]cuprate(1-)]	94247-64-0	Intentional addition / 1,000ppm	chemical products
18990	Chromate(1-), [3-[4,5-dihydro-4-[[2-(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]][N-[8-[[5-[[[ethylamino]carbonyl]amino]sulfonyl]-2-hydroxyphenyl]azo]-7-hydroxy-1-naphthalenyl]acetamidato(2-)]-, sodium	94247-65-1	Contains (regardless of intentional or impurities)	chemical products
18991	Hydrogen bis[[2,2'-iminobis(ethanolato)](2-)-O]borate(1-), compound with 6-[methyl(phenylsulphonyl)amino]hexanoic acid (1:1)	94247-66-2	1%	chemical products
18992	[Bis(trimethylsilyl)amine]dimethylindium	94265-92-6	1%	chemical products
18993	Tris[3-(dimethylamino)-2,2-dimethylpropyl] orthoborate	94266-00-9	1%	chemical products
18994	3-[[5,5-Dimethyl-1,3,2-dioxaborinan-2-yl]oxy]-N,N,2,2-tetramethylpropylamine	94266-01-0	1%	chemical products
18995	Cobalt(2+) potassium 2-hydroxypropane-1,2,3-tricarboxylate	94266-16-7	Intentional addition / 1%	chemical products
18996	Tin(2+) acrylate	94275-72-6	Contains (regardless of intentional or impurities)	chemical products
18997	Chromium(2+) methacrylate	94275-74-8	Contains (regardless of intentional or impurities)	chemical products
18998	Copper(1+) methacrylate	94275-75-9	Intentional addition / 1,000ppm	chemical products
18999	Iron(2+) methacrylate	94275-76-0	1%	chemical products
19000	Iron methacrylate	94275-77-1	1%	chemical products
19001	Nickel methacrylate	94275-78-2	Contains (regardless of intentional or impurities)	chemical products
19002	Chromium(2+) acrylate	94275-85-1	Contains (regardless of intentional or impurities)	chemical products
19003	Tin(4+) methacrylate	94275-86-2	Contains (regardless of intentional or impurities)	chemical products
19004	Cadmium (1-ethylhexyl) phthalate (1:2:2)	94275-93-1	Contains (regardless of intentional or impurities)	chemical products
19005	Cadmium octyl phthalate (1:2:2)	94275-94-2	Contains (regardless of intentional or impurities)	chemical products
19006	Hydrogen [6-amino-5-[[2-(2-hydroxy-4-nitrophenyl)azo]naphthalene-1-sulphonato(3-)]hydroxychromate(1-)]	94276-21-8	Contains (regardless of intentional or impurities)	chemical products
19007	Sodium hydroxy[3-[[2-(2-hydroxy-8-methylcarbamato-1-naphthyl)azo]-2-hydroxy-5-nitrobenzene-1-sulphonato(3-)]chromate(1-)]	94276-22-9	Contains (regardless of intentional or impurities)	chemical products
19008	Hydrogen hydroxy[ methyl 7-hydroxy-8-[[2-(2-hydroxy-5-nitro-3-sulphophenyl)azo]-1-naphthyl]carbamato(3-)]chromate(1-), compound with 2-(methylamino)ethanol (1:1)	94276-24-1	Contains (regardless of intentional or impurities)	chemical products
19009	Hydrogen hydroxy[2-hydroxy-3-[[2-(2-hydroxy-1-naphthyl)azo]-5-nitrobenzenesulphonato(3-)]chromate(1-), compound with 2-(methylamino)ethanol (1:1)	94276-26-3	Contains (regardless of intentional or impurities)	chemical products
19010	Hydrogen hydroxy[2-hydroxy-3-[[2-(2-hydroxy-1-naphthyl)azo]-5-nitrobenzenesulphonato(3-)]chromate(1-), compound with 2-aminoethanol (1:1)	94276-27-4	Contains (regardless of intentional or impurities)	chemical products
19011	Sodium [5-chloro-3-[[1,2-dihydro-4-hydroxy-2-oxoquinolin-3-yl]azo]-2-hydroxybenzenesulphonato(3-)]hydroxychromate(1-)]	94276-28-5	Contains (regardless of intentional or impurities)	chemical products
19012	Chromate(1-), [4,6-dihydroxy-3-[[2-(2-hydroxyphenyl)azo]-2-naphthalenesulphonato(3-)]hydroxy]-sodium	94276-29-6	Contains (regardless of intentional or impurities)	chemical products
19013	Chromate(1-), [4,6-dihydroxy-5-[[2-(2-hydroxyphenyl)azo]-2-naphthalenesulphonato(3-)]hydroxy]-sodium	94276-30-9	Contains (regardless of intentional or impurities)	chemical products
19014	Sodium [6-[[2,6-dihydroxy-3-[[2-(2-hydroxy-3,5-dinitrophenyl)azo]phenyl]azo]toluene-3-sulphonato(3-)]hydroxychromate(1-)]	94276-31-0	Contains (regardless of intentional or impurities)	chemical products
19015	Sodium [2,4-diamino-5-[[2-(2-hydroxy-3,5-dinitrophenyl)azo]benzenesulphonato(3-)]hydroxychromate(1-)]	94276-32-1	Contains (regardless of intentional or impurities)	chemical products
19016	Chromate(1-), hydroxy[2-hydroxy-5-nitro-3-[[2-oxo-1-[[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]-, hydrogen, compound with 3-[[2-ethylhexyl]oxy]-1-propanamine (1:1)	94276-33-2	Contains (regardless of intentional or impurities)	chemical products
19017	Xanthylum, 9-[2-(ethoxycarbonyl)phenyl]-3,6-bis(ethylamino)-2,7-dimethyl-, hydroxy[2-hydroxy-5-nitro-3-[[2-oxo-1-[[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]chromate(1-)]	94276-35-4	Contains (regardless of intentional or impurities)	chemical products
19018	Xanthylum, 9-[2-carboxyphenyl]-3,6-bis(diethylamino)-, hydroxy[2-hydroxy-5-nitro-3-[[2-oxo-1-[[[phenylamino]carbonyl]propyl]azo]benzenesulfonato(3-)]chromate(1-)]	94276-36-5	Contains (regardless of intentional or impurities)	chemical products
19019	Hydrogen [4-[[[2,4-dihydroxy-5-(o-tolylazo)phenyl]azo]-3-hydroxy-7-nitronaphthalene-1-sulphonato(3-)]chromate(1-)]	94276-37-6	Contains (regardless of intentional or impurities)	chemical products
19020	Bis(salicylato-O1,O2)chromium	94276-43-4	1,000ppm	chemical products
19021	Hydrogen(DL-methioninato-N.O.S)[sulphato(2-)-O]ferrate(1-)]	94276-44-5	1%	chemical products
19022	[5-Chloro-3-[[2,6-dihydroxyphenyl]azo]-2-hydroxybenzenesulphonato(3-)]iron	94276-45-6	1%	chemical products
19023	Trihydrogen [3-[[3-chloro-2-hydroxy-5-sulphophenyl]azo]-5-[[4-chloro-6-isopropoxy-1,3,5-triazin-2-yl]amino]-4-hydroxynaphthalene-2,7-disulphonato(5-)]cuprate(3-)]	94276-46-7	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
19024	Trisodium [3-[[[3-chloro-2-hydroxy-5-sulphophenyl]azo]-5-[[4-chloro-6-isopropoxy-1,3,5-triazin-2-yl]amino]-4-hydroxynaphthalene-2,7-disulphonato(5-)]cuprate(3-)	94276-47-8	Intentional addition / 1,000ppm	chemical products
19025	Magnesium tributoxyoxotitanate(1-) tributoxyoxozirconate(1-)	94276-53-6	Contains (regardless of intentional or impurities)	chemical products
19026	Bis[[2,2-(methylimino)bis[ethanolato]](1-)-N,O]diproxyzirconium	94276-54-7	Contains (regardless of intentional or impurities)	chemical products
19027	Bis[[2,2-(methylimino)bis[ethanolato]](1-)-N,O]bis[[2,2-(methylimino)bis[ethanolato]](2-)-O]zirconium	94276-55-8	Contains (regardless of intentional or impurities)	chemical products
19028	Sodium [4-hydroxy-3-[[2-hydroxy-1-naphthyl]azo]naphthalene-1,5-disulphonato(4-)]chromate(1-)	94276-64-9	Contains (regardless of intentional or impurities)	chemical products
19029	Hydrogen [3-hydroxy-4-[[[1-hydroxy-5-sulpho-2-naphthyl]azo]naphthalene-1-sulphonato(4-)]chromate(1-)]	94276-65-0	Contains (regardless of intentional or impurities)	chemical products
19030	Hydrogen [7-amino-4-hydroxy-8-[[[2-hydroxy-4-nitrophenyl]azo]-3-[[4-sulphophenyl]azo]naphthalene-2-sulphonato(4-)]chromate(1-)]	94276-66-1	Contains (regardless of intentional or impurities)	chemical products
19031	Hydrogen [5-chloro-3-[[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulphophenyl)-1H-pyrazol-4-yl]azo]-2-hydroxybenzene-1-sulphonato(4-)]chromate(1-)]	94276-67-2	Contains (regardless of intentional or impurities)	chemical products
19032	Tetrahydrogen [mu-[[[7-[[[6-chloro-1,3,5-triazine-2-diy]diimino]bis[4-hydroxy-3-[[2-hydroxy-5-sulphophenyl]azo]naphthalene-2-sulphonato]](8-)]]]dicuprate(4-)]	94276-68-3	Intentional addition / 1,000ppm	chemical products
19033	Disodium [3-[[[5,8-dichloro-2-hydroxy-1-naphthyl]azo]-4-hydroxybenzenesulphonamidato(2-)](3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]chromate(2-)]	94276-69-4	Contains (regardless of intentional or impurities)	chemical products
19034	Dihydrogen [3-[[[5,8-dichloro-2-hydroxy-1-naphthyl]azo]-4-hydroxybenzenesulphonamidato(2-)](3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]chromate(2-)]	94276-70-7	Contains (regardless of intentional or impurities)	chemical products
19035	Pentahydrogen bis[4-[[[6-[[4-chloro-6-[[2-hydroxyethyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-2-naphthyl]-3-sulpho]azo]-3-hydroxy-7-nitronaphthalen-1-sulphonato(4-)]cobaltate(5-)]	94276-71-8	Intentional addition / 1%	chemical products
19036	Pentasaosium bis[4-[[[6-[[4-chloro-6-[[2-hydroxyethyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-2-naphthyl]-3-sulpho]azo]-3-hydroxy-7-nitronaphthalen-1-sulphonato(4-)]cobaltate(5-)]	94276-72-9	Intentional addition / 1%	chemical products
19037	Trihydrogen bis[3-[[[4-chloro-6-[[2-hydroxyethyl]amino]-1,3,5-triazin-2-yl]amino]-5-[[[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulphonato(3-)]cobaltate(3-)]	94276-73-0	Intentional addition / 1%	chemical products
19038	Trisodium bis[3-[[[4-chloro-6-[[2-hydroxyethyl]amino]-1,3,5-triazin-2-yl]amino]-5-[[[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulphonato(3-)]cobaltate(3-)]	94276-74-1	Intentional addition / 1%	chemical products
19039	Trisodium [7-[[[4-chloro-6-[[2-sulphoamino]-1,3,5-triazin-2-yl]methyl]amino]-4-hydroxy-3-[[2-hydroxy-5-sulphophenyl]azo]naphthalene-2-sulphonato(5-)]cuprate(3-)]	94276-75-2	Intentional addition / 1,000ppm	chemical products
19040	Trihydrogen [7-[[[4-chloro-6-[[2-sulphoamino]-1,3,5-triazin-2-yl]methyl]amino]-4-hydroxy-3-[[2-hydroxy-5-sulphophenyl]azo]naphthalene-2-sulphonato(5-)]cuprate(3-)]	94276-76-3	Intentional addition / 1,000ppm	chemical products
19041	Sodium bis[3-[[[5,8-dichloro-1-hydroxy-2-naphthyl]azo]-4-hydroxybenzenesulphonamidato(2-)]cobaltate(1-)]	94276-77-4	Intentional addition / 1%	chemical products
19042	Cuprate(3-), [mu-[[[2-[[[6-[[[4-[[[2-[[4-[[[2-carboxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-2-sulphophenyl]ethenyl]-3-sulphophenyl]amino]-6-phenyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(7-)]]]]]]]di-, trihydrogen	94276-78-5	Intentional addition / 1,000ppm	chemical products
19043	Cuprate(3-), [mu-[[[2-[[[6-[[[4-[[[2-[[4-[[[2-carboxyphenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]-2-sulphophenyl]ethenyl]-3-sulphophenyl]amino]-6-phenyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(7-)]]]]]]]di-, trisodium	94276-79-6	Intentional addition / 1,000ppm	chemical products
19044	Dihydrogen [3-[[[4-hydroxy-3-[[[2-hydroxy-1-naphthyl]azo]phenyl]azo]benzenesulphonato(3-)](2-[[[2-hydroxy-5-nitrophenyl]azo]-4-tert-pentylphenolato(2-)]chromate(2-)]	94276-80-9	Contains (regardless of intentional or impurities)	chemical products
19045	Chromate(3-), [4-hydroxy-3-[[[2-hydroxy-3,5-dinitrophenyl]azo]-6-[[[4-methylphenyl]sulfonyl]amino]-2-naphthalenesulphonato(3-)](3-hydroxy-4-[[[2-hydroxy-1-naphthyl]azo]-7-nitro-1-naphthalenesulphonato(3-)]-trihydrogen	94276-81-0	Contains (regardless of intentional or impurities)	chemical products
19046	Hydroxy[2-mercaptopethyl stearato-O]Sbarium	94276-85-4	Contains (regardless of intentional or impurities)	chemical products
19047	[29H,31H-Phthalocyanine-1,11,17,23-tetrahiolato(2-)-N29,N30,N31,N32]copper, tetrasodium salt	94276-86-5	Intentional addition / 1,000ppm	chemical products
19048	Tris[[1,1,3,3-tetramethyl-1-(eta-2-vinyl)-3-vinyl]dioxolane]platinum	94276-87-6	Contains (regardless of intentional or impurities)	chemical products
19049	Mercurate(1-), [dodecylbutanedioato(2-)-O]phenyl-, hydrogen	94276-88-7	Contains (regardless of intentional or impurities)	chemical products
19050	Disodium hydrogen bis[4-[[[5-acetyl-2,4-dihydroxyphenyl]azo]-3-hydroxy-7-nitronaphthalene-1-sulphonato(3-)]ferrate(3-)]	94276-89-8	1%	chemical products
19051	Tris(6-methylheptane-2,4-dionato-O,O')iron	94276-94-5	1%	chemical products
19052	Tris(6-methylheptane-2,4-dionato-O,O')chromium	94276-95-6	1,000ppm	chemical products
19053	Iron, compound with molybdenum (2:3)	94277-04-0	Contains (regardless of intentional or impurities)	chemical products
19054	Aluminium, compound with manganese (5:1)	94277-05-1	Contains (regardless of intentional or impurities)	chemical products
19055	[Undecachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	94277-09-5	Intentional addition / 1,000ppm	chemical products
19056	[Dodecachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	94277-10-8	Intentional addition / 1,000ppm	chemical products
19057	[Tridecachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	94277-11-9	Intentional addition / 1,000ppm	chemical products
19058	[Tetradecachloro-29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]copper	94277-12-0	Intentional addition / 1,000ppm	chemical products
19059	Cuprate(1-), [C,C-bis[[dibutylamino]sulfonyl]-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, ammonium	94277-13-1	Intentional addition / 1,000ppm	chemical products
19060	Cuprate(1-), [C,C,C-tris[[dibutylamino]sulfonyl]-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, ammonium	94277-14-2	Intentional addition / 1,000ppm	chemical products
19061	Hydrogen bis[[[3-(cyclohexylamino)propyl]amino]sulfonyl]-29H,31H-phthalocyaninesulphonato(3-)-N29,N30,N31,N32]cuprate(1-)]	94277-15-3	Intentional addition / 1,000ppm	chemical products
19062	Cuprate(1-), [C,C,C-tris[[[3-(cyclohexylamino)propyl]amino]sulfonyl]-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen	94277-16-4	Intentional addition / 1,000ppm	chemical products
19063	Dihydrogen [29H,31H-phthalocyaninedisulphonato(4-)-N29,N30,N31,N32]cuprate(2-), compound with N,N-di-(o-tolyl)guanidine (1:2)	94277-17-5	Intentional addition / 1,000ppm	chemical products
19064	Cobaltate(4-), [3-[[[4-chloro-6-[[2-hydroxyethyl]amino]-1,3,5-triazin-2-yl]amino]-5-[[[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulphonato(3-)](4-[[[6-[[[4-chloro-6-[[2-hydroxyethyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulphonato(4-)]-], tetrahydrogen	94277-51-7	Intentional addition / 1%	chemical products
19065	Cobaltate(4-), [3-[[[4-chloro-6-[[2-hydroxyethyl]amino]-1,3,5-triazin-2-yl]amino]-5-[[[4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulphonato(3-)](4-[[[6-[[[4-chloro-6-[[2-hydroxyethyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulphonato(4-)]-], tetrasodium	94277-52-8	Intentional addition / 1%	chemical products
19066	Hydrogen mu-hydroxy[mu-orthoborato(3-)-O,O']diphendimercurate(1-)]	94277-53-9	Contains (regardless of intentional or impurities)	chemical products
19067	Sodium [4-[[[4,5-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulphonato(3-)]cuprate(1-)]	94277-54-0	Intentional addition / 1,000ppm	chemical products
19068	Hydrogen bis[2,4-dihydroxy-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-), compound with 2-(dodecylamino)ethanol (1:1)	94277-59-5	Contains (regardless of intentional or impurities)	chemical products
19069	Trisodium bis[7-amino-4-hydroxy-3-[[[2-hydroxy-3,5-dinitrophenyl]azo]naphthalene-2-sulphonato(3-)]chromate(3-)]	94277-60-8	Contains (regardless of intentional or impurities)	chemical products
19070	Hydrogen bis[1-[[[2-hydroxy-4-nitrophenyl]azo]-2-naphtholato(2-)]chromate(1-), compound with 2-(dodecylamino)ethanol (1:1)	94277-61-9	Contains (regardless of intentional or impurities)	chemical products
19071	Chromate(3-), bis[[[4,5-dihydro-3-methyl-5-oxo-1-(4-sulphophenyl)-1H-pyrazol-4-yl]azo]benzoato(3-)]-, trisodium	94277-62-0	Contains (regardless of intentional or impurities)	chemical products
19072	Hydrogen bis[1-[[[5-chloro-2-hydroxyphenyl]azo]-2-naphtholato(2-)]chromate(1-), compound with 2-(dodecylamino)ethanol (1:1)	94277-63-1	Contains (regardless of intentional or impurities)	chemical products
19073	Bis[[2-(2-butoxyethoxy)ethanolato]bis(2-2-butoxyethoxy)ethanolato-O]zirconium	94277-64-2	Contains (regardless of intentional or impurities)	chemical products
19074	Chromate(1-), dihydroxy[3-[[[8-hydroxy-7-quinolinyl]azo]benzenesulfonato(2-)]-, sodium	94277-67-5	Contains (regardless of intentional or impurities)	chemical products
19075	Chromate(1-), [8-[[[5-chloro-2-hydroxyphenyl]azo]-7-hydroxy-1,3-naphthalenedisulfonato(4-)]-, sodium	94277-68-6	Contains (regardless of intentional or impurities)	chemical products
19076	Chromate(1-), 5-[[[5-chloro-2-hydroxyphenyl]azo]-6-hydroxy-2-naphthalenesulfonato(3-)]hydroxy-	94277-69-7	Contains (regardless of intentional or impurities)	chemical products
19077	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, [5-[[[5-chloro-2-hydroxyphenyl]azo]-6-hydroxy-2-naphthalenesulfonato(3-)]hydroxy]chromate(1-)]	94277-70-0	1,000ppm	chemical products
19078	Chromium, [5-chloro-2-hydroxy-3-[[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonato(3-)]-	94277-71-1	1,000ppm	chemical products
19079	[29H,31H-Phthalocyanine-1,8,16,23-tetrahiolato(2-)-N29,N30,N31,N32]copper, tetrasodium salt	94277-73-3	Intentional addition / 1,000ppm	chemical products
19080	Hydrogen bis[1-[[[2,4-dihydroxy-5-[[[2-hydroxy-6-nitro-1-naphthyl]azo]phenyl]ethanonato(2-)]chromate(1-)]	94277-74-4	Contains (regardless of intentional or impurities)	chemical products
19081	Cuprate(1-), [C-[[[dibutylamino]sulfonyl]-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, ammonium	94277-75-5	Intentional addition / 1,000ppm	chemical products
19082	Cuprate(1-), [C,C,C-tris[[[3-[[[2-ethylhexyloxy]propyl]amino]sulfonyl]-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen, compound with 3-[[[2-ethylhexyloxy]-1-propanamine (1:1)	94277-77-7	Intentional addition / 1,000ppm	chemical products
19083	Bis[1-(2-hydroxy-5-tert-nonylphenyl)ethanone oximato]cobalt	94277-78-8	Intentional addition / 1%	chemical products
19084	Tris[octahydro-4,7-methano-1H-indene-5-methanol], triester with boric acid	94277-88-0	1%	chemical products
19085	Sodium hydrogen allylarsenate	94278-22-5	Contains (regardless of intentional or impurities)	chemical products
19086	3-(Boronooxy)-2-hydroxypropyl stearate	94278-23-6	1%	chemical products
19087	1,1,3,3-tetrabutyl-1,3-bis[[1-oxoisooctadecyl]oxy]distannoxane	94279-11-5	Contains (regardless of intentional or impurities)	chemical products
19088	Ferrate(4-), hexakis(cyano-C), oxidized N,N-dimethylbenzenamine, N-ethyl-2-methylbenzenamine, formaldehyde reaction products, copper(1+) salts	94279-42-2	Intentional addition / 1,000ppm	chemical products
19089	Silicic acid (H4SiO4), zirconium(4+) salt (1:1), reaction products with sodium hydroxide	94279-56-8	Contains (regardless of intentional or impurities)	chemical products
19090	Silicic acid (H4SiO4), zirconium(4+) salt (1:1), reaction products with sodium hydroxide, hydrolyzed	94279-57-9	Contains (regardless of intentional or impurities)	chemical products
19091	Zirconate(2-), orthosilicato(4-)-O]lower, disodium, reaction products with hydrochloric acid	94279-60-4	Contains (regardless of intentional or impurities)	chemical products
19092	Chromate(3-), bis[3-hydroxy-4-[[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, trihydrogen, compound with 2-(dodecylamino)ethanol and 2-ethyl-1-hexanamine (1:2:1)	94292-05-4	Contains (regardless of intentional or impurities)	chemical products
19093	Chromate(3-), bis[4-[[[4,5-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, trihydrogen, compound with 2-(dodecylamino)ethanol (1:3)	94292-06-5	Contains (regardless of intentional or impurities)	chemical products
19094	Cobaltate(7-), [5-[[[4-chloro-6-[[[5-[[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[[2-hydroxy-5-sulphophenyl]azo]-2,7-naphthalenedisulfonato(6-)](3-[[[1-[[[4-[[4-chloro-6-[[[5-[[[5-chloro-2,6-difluoro-4-pyrimidinyl]amino]-2-sulphophenyl]amino]-1,3,5-triazin-2-yl]amino]phenyl]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxybenzenesulfonato(4-)]-], heptasodium	94292-07-6	Intentional addition / 1%	chemical products
19095	Sodium [3-[[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]hydroxychromate(1-)]	94292-08-7	Contains (regardless of intentional or impurities)	chemical products
19096	Metaboric acid, compound with 1,3,5,7-tetraazacyclo[3.3.1.1.3]heptane (3:1)	94313-53-8	1%	chemical products
19097	Disodium p-tolylarsenate	94313-58-3	Contains (regardless of intentional or impurities)	chemical products
19098	Barium hydrogen 1-oxopropane-1,2,3-tricarboxylate	94313-94-7	Contains (regardless of intentional or impurities)	chemical products
19099	Dihydrogen heptaacetotetrateborate(2-), compound with cyclohexylamine (1:2)	94314-05-3	1%	chemical products
19100	Cuprate(2-), [4-[[[4,5-dihydro-4-[[[2-hydroxy-5-[[[2-sulfoxy]ethyl]sulfonyl]phenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(4-)]-], dipotassium	94314-07-5	Intentional addition / 1,000ppm	chemical products
19101	Chromium 1,2,3,6-tetrahydro-2,6-dioxopyrimidine-4-carboxylate (1:3)	94333-35-4	1,000ppm	chemical products
19102	Iron 1,2,3,6-tetrahydro-2,6-dioxopyrimidine-4-carboxylate (1:2)	94333-36-5	1%	chemical products
19103	Cobalt 1,2,3,6-tetrahydro-2,6-dioxopyrimidine-4-carboxylate (1:2)	94333-37-6	Intentional addition / 1%	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
19104	Manganese 1,2,3,6-tetrahydro-2,6-dioxopyrimidine-4-carboxylate (1:2)	94333-38-7	Contains (regardless of intentional or impurities)	chemical products
19105	Tin 1,2,3,6-tetrahydro-2,6-dioxopyrimidine-4-carboxylate (1:2)	94333-39-8	Contains (regardless of intentional or impurities)	chemical products
19106	Carbonic dichloride, polymer with 4,4'-[1-methylethyldiene]bis[2,6-dibromophenol] and phenol	94334-64-2	900ppm	chemical products
19107	(9Z,12Z,15Z)-1,1,3,3-Tetrabutyl-1,3-bis(octadeca-9,12,15-trienyloxy)distannoxane	94349-25-4	Contains (regardless of intentional or impurities)	chemical products
19108	(9Z,12Z)-1,1,3,3-tetrabutyl-1,3-bis(octadeca-9,12-dienyloxy)distannoxane	94349-26-5	Contains (regardless of intentional or impurities)	chemical products
19109	Bis(octadeca-9(2Z),12(Z),15(Z)-trienyloxy)diethylstannane	94349-27-6	Contains (regardless of intentional or impurities)	chemical products
19110	Saccharomyces cerevisiae, chromium-rich	94350-11-5	1,000ppm	chemical products
19111	1H-1,2,4-Triazole, 1-ethanol, alpha-(4-chlorophenyl)-alpha-(1-cyclopropylethyl)-	94361-06-5	Contains (regardless of intentional or impurities)	chemical products
19112	[R-(R*,R*)]-Tartaric acid, potassium zirconium salt	94368-15-9	Contains (regardless of intentional or impurities)	chemical products
19113	Diocetyl tin	94410-05-6	Contains (regardless of intentional or impurities)	chemical products
19114	Antimony pentakis[1R-(1.alpha.,4a.beta.,4b.alpha.,10a.alpha.)-1,2,3,4,4a,4b,5,6,10,10a-decahydro-7-isopropyl-1,4-dimethylphenanthrene-1-carboxylate	94442-00-9	Contains (regardless of intentional or impurities)	chemical products
19115	[Bis(2-butaxy-3-oxopropyl)stannylene]bis(thioethylene) sebacate	94442-03-2	Contains (regardless of intentional or impurities)	chemical products
19116	Platinum, trimethyl[(1,2,3,4,5-eta)-1-methyl-2,4-cyclopentadien-1-yl]-	94442-22-5	Contains (regardless of intentional or impurities)	chemical products
19117	Barium dimethylhexanoate	94481-49-9	Contains (regardless of intentional or impurities)	chemical products
19118	Ammonium [N,N-bis(carboxymethyl)glycinate(3-)-N.O.O']manganate(1-)	94481-60-4	Contains (regardless of intentional or impurities)	chemical products
19119	Bis[butane-2,3-dione dioximate(1-)-N,N]cobalt(1+) nitrate	94481-61-5	Intentional addition / 1%	chemical products
19120	Tris(5-oxo-DL-prolinato-N1,O2)yttrium	94481-63-7	1%	chemical products
19121	Ammonium [trisulfamoyl-29H,31H-phthalocyaninesulphonato(3-)-N29,N30,N31,N32]cuprate(1-)	94534-99-3	Intentional addition / 1,000ppm	chemical products
19122	[R-(R*,R*)]-Tartaric acid, sodium zirconium salt	94536-69-3	Contains (regardless of intentional or impurities)	chemical products
19123	Braunite, brown	94551-57-2	Contains (regardless of intentional or impurities)	chemical products
19124	Calcium chromium tin oxide, crimson	94551-58-3	Contains (regardless of intentional or impurities)	chemical products
19125	Copper, dross	94551-59-4	Intentional addition / 1,000ppm	chemical products
19126	Leach residues, cadmium-containing flue dust	94551-70-9	Contains (regardless of intentional or impurities)	chemical products
19127	Residues, tin spray coating - Residues from the spraying of tin-based metallic coating by feeding wire or metallic powder into a flame or plasma arc. Consists primarily of tin with varying amounts of cadmium and/or zinc, mainly as metals with some oxides.	94551-80-1	Contains (regardless of intentional or impurities)	chemical products
19128	Scale (coating), mill, copper - Substance obtained as scale during heat treatment of copper and copper alloys. Consists primarily of copper oxides.	94551-81-2	Intentional addition / 1,000ppm	chemical products
19129	Slimes and Sludges, copper electrolytic refining, decopperized	94551-87-8	Contains (regardless of intentional or impurities)	chemical products
19130	Slimes and sludges, copper pickling - Substance precipitated during the neutralization of acidic, copper-containing solutions from galvanic and pickling treatment of copper materials. Consists primarily of basic copper salts and calcium sulfate.	94551-88-9	Intentional addition / 1,000ppm	chemical products
19131	Slimes and sludges, copper treatment - Deposit formed in copper wire drawing lubricants. Consisting primarily of copper, copper oxides, and soaps and degraded soaps and oils, it may also contain tin and tin compounds from tinned copper wire.	94551-89-0	Intentional addition / 1,000ppm	chemical products
19132	Slimes and sludges, zinc calcium leach solution, peroxidized, manganese dioxide-containing	94551-96-9	Contains (regardless of intentional or impurities)	chemical products
19133	Waste solids, copper-containing anthrathol dye	94552-01-9	Intentional addition / 1,000ppm	chemical products
19134	Waste solids, copper-containing dye - A precipitation product of dye production. Composed primarily of copper (II) phosphate with minor amounts of basic copper (II) carbonate and copper (II) acetate.	94552-02-0	Intentional addition / 1,000ppm	chemical products
19135	Chromate(4-), [2,5-dichloro-4-[[4-hydroxy-3-[[[2-(phenylamino)ethyl]imino]methyl]phenyl]azo]benzenesulfonato(3-)]-3-hydroxy-4-[(1-hydroxy-8-sulfo-2-naphthalenyl)azo]-1-naphthalenesulfonato(4-)]-, sodium	94552-19-9	Contains (regardless of intentional or impurities)	chemical products
19136	Chromium, diazotized 2-amino-4,6-dinitrophenol-diazotized 6( or 7)-amino-4-hydroxy-2-naphthalenesulfonic acid-formaldehyde-resorcinol reaction product coupling products complexes	94552-20-2	1,000ppm	chemical products
19137	Octanoic acid, branched, zirconium salt (2:1)	94581-21-2	Contains (regardless of intentional or impurities)	chemical products
19138	Cobaltate(1-), [4-[17-[(acetyloxy)amino]-2-hydroxy-1-naphthalenyl]azo]-3-hydroxy-N-[[methylamino]carbonyl]benzenesulfonamido(2-)]-[4-[1-(4-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxy-N-[[methylamino]carbonyl]benzenesulfonamido(2-)]-, sodium	94624-01-8	Intentional addition / 1%	chemical products
19139	Copper, amine chloro complexes	94624-19-8	Intentional addition / 1,000ppm	chemical products
19140	Cobalt, [hexamethylenedisulfonocarbamate]-, dihydrate	94648-71-2	Intentional addition / 1%	chemical products
19141	Poly(oxy-1,2-ethanediy), alpha-[2-(dicycylmethylammonio)ethyl]-omega-hydroxy-, propanoate (salt)	94667-33-1	Intentional addition / 1,000ppm	chemical products
19142	Copper, chloro[29H,31H-phthalocyaninato(2-)-kappa.N29,kappa.N30,kappa.N31,kappa.N32]-, (SP-5-12)-	94701-72-1	Intentional addition / 1,000ppm	chemical products
19143	2-Butyryl-3-hydroxy-5-thiocyclohexan-3-yl-cyclohex-2-en-1-one	94723-86-1	Contains (regardless of intentional or impurities)	chemical products
19144	Distillates (petroleum), solvent-refined hydrotreated heavy, hydrogenated	94733-08-1	Contains (regardless of intentional or impurities)	chemical products
19145	Distillates (petroleum), solvent-refined hydrocracked light	94733-09-2	Contains (regardless of intentional or impurities)	chemical products
19146	Lubricating oils (petroleum), C18-40, solvent-dewaxed hydrocracked distillate-based	94733-15-0	Contains (regardless of intentional or impurities)	chemical products
19147	Lubricating oils (petroleum), C18-40, solvent-dewaxed hydrogenated raffinate-based	94733-16-1	Contains (regardless of intentional or impurities)	chemical products
19148	DL-Alanine, N-(2,6-dimethylphenyl)-N-(phenylacetyl)-, methyl ester, mixture with [[1,2-ethanediy]bis[carbamo(2-thio)ato]](2-)zinc	94786-86-4	Contains (regardless of intentional or impurities)	chemical products
19149	Vitamin B12, mixture with iron dextran	94786-94-4	Intentional addition / 1%	chemical products
19150	Cuprate(3-), [2-[[[3-(4,6-dichloro-1,3,5-triazin-2-yl)amino]-2-hydroxy-5-sulfophenyl]azo]phenylmethyl]azo]-4-sulfobenzoato(5-)]-, disodium hydrogen, (SP-4-3)-	94805-01-3	Intentional addition / 1,000ppm	chemical products
19151	Trisodium [N,N-bis[2-bis(carboxymethyl)amino]ethyl]glycinate(5-)]ferrate(3-)	94825-16-8	1%	chemical products
19152	Bis(nitrotriacetic acid) antimony complex	94825-20-4	Contains (regardless of intentional or impurities)	chemical products
19153	3,4-(Methylenedioxy)phenylboronic acid	94839-07-3	1%	chemical products
19154	Octyl acrylate-methyl methacrylate-triphenyltin methacrylate copolymer	94857-33-7	Contains (regardless of intentional or impurities)	chemical products
19155	Boric acid (H3BO3), reaction products with N,N'-bis(hydroxymethyl)urea, ethylene glycol, formaldehyde, glutaraldehyde and tetrahydro-1,3,4,6-tetrakis(hydroxymethyl)imidazo[4,5-d]imidazole-2,5-(1H,3H)-di-1-one	94891-35-7	1%	chemical products
19156	Glycine, N-[[C(10)-22-branched and linear alkyl and naphthyl]sulfonyl] derivatives, barium salts (2:1)	94891-40-4	Intentional addition / 1,000ppm	chemical products
19157	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with 2-[[4-(aminophenyl)sulfonyl]ethyl]hydrogen sulfate monosodium salt, potassium salts	94891-42-6	Contains (regardless of intentional or impurities)	chemical products
19158	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, chlorosulfonyl derivatives, reaction products with 2-[[4-(aminophenyl)sulfonyl]ethyl]hydrogen sulfate monosodium salt, sodium salts	94891-43-7	Contains (regardless of intentional or impurities)	chemical products
19159	Chromate(3-), bis[2-[[2,4-dihydroxy-3-[[5-sulfo-1-naphthalenyl]azo]phenyl]azo]benzoato(3-)]-, trisodium	94933-05-8	Contains (regardless of intentional or impurities)	chemical products
19160	Hexanoic acid, 3,5-dimethyl-, zirconium(4+) salt	94938-95-1	Contains (regardless of intentional or impurities)	chemical products
19161	Trisodium 4-hydroxy-3-[[4-[[1-hydroxy-3-(phenylamino)-3-sulphonato-2-naphthyl]azo]-3,3-dimethoxy(1,1'-biphenyl)-4-yl]azo]naphthalene-1,5-disulphonate	94944-81-7	Intentional addition	chemical products
19162	Cuprate(4-), [2-[2-[2-[3-[[4-chloro-6-(ethyl[3-[[2-[[sulfoxy]ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa.O)-5-sulfo]phenyl]diazanyl-kappa.N2]phenylmethyl]diazanyl-kappa.N1]-4-sulfo]benzoato(6-)-kappa.O]-, sodium (1:4)	94956-11-3	Intentional addition / 1,000ppm	chemical products
19163	Hydrogen (2-aminoethanolato-N,O)aque[3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]chromate(1-)	94979-18-7	Contains (regardless of intentional or impurities)	chemical products
19164	Sodium hydroxy[3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]-7-nitronaphthalene-1-sulphonato(3-)]chromate(1-)	94979-19-8	Contains (regardless of intentional or impurities)	chemical products
19165	(Ethylenediamine-N)(1-imino-1H-isoindol-3-amine-N2)[29H,31H-phthalocyaninato-N29,N30,N31,N32]cobalt	94979-20-1	Intentional addition / 1%	chemical products
19166	Hydrogen sodium [1-[[5-chloro-2-hydroxy-4-nitrophenyl]azo]-2-naphtholato(2-)]-[3-hydroxy-4-[[2-hydroxy-1-naphthyl]azo]naphthalene-1-sulphonato(3-)]chromate(2-)	95008-81-4	Contains (regardless of intentional or impurities)	chemical products
19167	Barium bis[1-(hydroxymethyl)-5-oxo-DL-prolinate]	95008-97-2	Contains (regardless of intentional or impurities)	chemical products
19168	Cuprate(1-), [4-[[dihydroxy[[2-hydroxy-3,5-dinitrophenyl]azo]phenyl]azo]benzenesulfonato(3-)]-, sodium	95009-01-1	Intentional addition / 1,000ppm	chemical products
19169	Tricopper(1+) hydrogen hexakis(cyano-c)ferrate(4-), compound with 4-[[4-(dimethylamino)phenyl][4-(ethylimino)-1(4H)-naphthylidene]methyl]-N,N-dimethylaniline (1:1)	95009-03-3	Intentional addition / 1,000ppm	chemical products
19170	Neodecanoic acid, barium salt, reaction products with 1-chlorobutane, 1-chlorooctane and magnesium	95009-10-2	Intentional addition / 1,000ppm	chemical products
19171	Distillates (petroleum), steam-cracked, C8-12 fraction, polymerized, distillation lights	95009-23-7	Contains (regardless of intentional or impurities)	chemical products
19172	Oxirane, [(2-propenyloxy)methyl]-, (2S)-	95043-55-3	1%	chemical products
19173	Oxirane, [(2-propenyloxy)methyl]-, (R)-	95043-56-4	1%	chemical products
19174	Sphene, chromium tin pink violet	95046-44-9	Contains (regardless of intentional or impurities)	chemical products
19175	Spinels, cobalt nickel zinc grey	95046-47-2	Contains (regardless of intentional or impurities)	chemical products
19176	Spinels, cobalt zinc blue green	95046-48-3	Intentional addition / 1%	chemical products
19177	Spinels, manganese brown	95046-51-8	Contains (regardless of intentional or impurities)	chemical products
19178	Amines, C10-14-branched and linear alkyl, hydroxy[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]chromate(1-)	95193-71-8	Contains (regardless of intentional or impurities)	chemical products
19179	Rutile, antimony titanium yellow orange	95193-93-4	Contains (regardless of intentional or impurities)	chemical products
19180	Zircon, silicon zirconium grey	95193-95-6	Contains (regardless of intentional or impurities)	chemical products
19181	Quinolinium, 7-[(ethoxymethyl)phosphono]oxy]-1-methyl-, iodide (1:1)	95230-44-7	Intentional addition / 1,000ppm	chemical products
19182	Methyl 2-(2-chloromethyl)phenylacetate	95360-33-1	Contains (regardless of intentional or impurities)	chemical products
19183	Cuprate(2-), [2-[[[2,4-dihydroxy-5-[[2-hydroxy-5-sulfo]phenyl]azo]phenyl]azo]phenyl]-6-methyl-7-benzothiazolesulfonato(4-)]-, ammonium sodium	95370-52-8	Intentional addition / 1,000ppm	chemical products
19184	Cuprate(4-), [mu.-[[4,4'-[azobis[[2-hydroxy-4,1-phenylene]azo(8-hydroxy-6-sulfo-7,2-naphthalenediy]imino)]bis(benzoato)](8-)]di-, potassium sodium	95370-53-9	Intentional addition / 1,000ppm	chemical products
19185	Hydrocarbons, C13-30, aromatic-rich, solvent-extracted naphthenic distillate	95371-04-3	Contains (regardless of intentional or impurities)	chemical products
19186	Hydrocarbons, C16-32, aromatic rich, solvent-extracted naphthenic distillate	95371-05-4	Contains (regardless of intentional or impurities)	chemical products
19187	Hydrocarbons, C37-68, dewaxed deasphalted hydrotreated vacuum distillation residues	95371-07-6	Contains (regardless of intentional or impurities)	chemical products
19188	Hydrocarbons, C37-65, hydrotreated deasphalted vacuum distillation residues	95371-08-7	Contains (regardless of intentional or impurities)	chemical products
19189	Sulfonic acids, petroleum, calcium salts, overbased, compounds with boric acid (H3BO3)	95371-17-8	1%	chemical products
19190	Methanesulphonic acid (R)-2-methyl-4-oxo-3-(2-propenyl)-2-cyclopentyl	95413-90-2	Contains (regardless of intentional or impurities)	chemical products
19191	N-Ethylideneethylenediamine	95465-58-0	Contains (regardless of intentional or impurities)	chemical products
19192	Fatty acids, C14-18 and C16-18-unsaturated, barium salts	95465-59-3	Intentional addition / 1,000ppm	chemical products
19193	Hydrocarbons, C4, 1,3-butadiene- and isobutene-free	95465-59-7	Contains (regardless of intentional or impurities)	chemical products
19194	Spinels, chromium cobalt blue green	95465-96-6	Intentional addition / 1,000ppm	chemical products
19195	Spinels, chromium green	95465-97-7	1,000ppm	chemical products
19196	Cadusafas	95465-99-9	Intentional addition / 1%	chemical products
19197	Anilinium tripolyphosphate	95478-50-5	Contains (regardless of intentional or impurities)	chemical products
19198	Formaldehyde, polymer with 1-amino-2-propanol	95566-38-4	Contains (regardless of intentional or impurities)	chemical products
19199	Carbonylchloride acid, 1-chloroethyl ester, (±)-	95597-56-1	Contains (regardless of intentional or impurities)	chemical products
19200	1-(4-Hydroxyphenyl)-2-propene-1-one	95605-38-2	Contains (regardless of intentional or impurities)	chemical products
19201	2-Octene, 1-bromo-3,7-dimethyl-	95653-62-6	1,000ppm	chemical products
19202	Calcium bis[μ-tartrato(4-)-O1,O2,O3,O4]diantimonate(2-), stereoisomer	95722-64-8	Contains (regardless of intentional or impurities)	chemical products
19203	Dibutylbis(octadeca-9(2Z),12(Z),15(Z)-trienyloxy)stannane	95873-60-2	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
19204	Dihydrogen bis[8-hydroxy-7-iodoquinoline-5-sulphonato(2-)-N1,O8]cuprate(2-), compound with trimethylamine (1:2)	95873-71-5	Intentional addition / 1,000ppm	chemical products
19205	Dihydrogen bis[8-hydroxyquinoline-5-sulphonato(2-)-N1,O8]cuprate(2-), compound with trimethylamine (1:2)	95873-72-6	Intentional addition / 1,000ppm	chemical products
19206	Dihydrogen bis[8-hydroxyquinoline-5-sulphonato(2-)-N1,O8]cobaltate(2-), compound with trimethylamine (1:2)	95873-73-7	Intentional addition / 1%	chemical products
19207	[3-[[1-(Anilinoacetyl)-2-oxopropyl]azo]-2-hydroxy-5-nitrobenzene-1-sulphonato(3-)]tris(cyclohexylammonium)chromium	95873-74-8	1,000ppm	chemical products
19208	Trihydrogen bis[3-[[1-(Anilinoacetyl)-2-oxopropyl]azo]-2-hydroxy-5-nitrobenzene-1-sulphonato(3-)]chromate(3-), compound with 2,2'-(dodecylimino)bis[ethanol] (1:3)	95873-75-9	Contains (regardless of intentional or impurities)	chemical products
19209	Sodium [2,4-diamino-5-[(2-hydroxy-5-nitrophenyl)azo]benzene-1-sulphonato(3-)]ferrate(1-)	95873-76-0	1%	chemical products
19210	Hydrogen hydroxy[3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]chromate(1-), compound with 2,2'-nitrotriethanol (1:1)	95892-09-4	Contains (regardless of intentional or impurities)	chemical products
19211	Chromate(5-), bis[4-[[4,5-dihydro-3-methyl-5-oxo-1-(3-sulfonylphenyl)-1H-pyrazol-4-yl]azo]-3-hydroxy-1-naphthalenesulfonate(4-)]-, pentahydrogen	95892-10-7	Contains (regardless of intentional or impurities)	chemical products
19212	Trihydrogen bis[2,5-dichloro-4-[[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulphonato(3-)]chromate(3-)	95892-11-8	Contains (regardless of intentional or impurities)	chemical products
19213	Cadmium isohexadecanoate	95892-12-9	Contains (regardless of intentional or impurities)	chemical products
19214	Boric acid (H3BO3), barium salt (3:1)	95905-86-5	Intentional addition / 1,000ppm	chemical products
19215	2-(4-Chloromethyl-4-hydroxy-2-thiazoline-2-yl)guanidine hydrochloride	95907-33-8	Contains (regardless of intentional or impurities)	chemical products
19216	Tetrahydrogen [29H,31H-phthalocyaninetetrasulphonato(6-)-N29,N30,N31,N32]cuprate(4-), compound with N,N'-di-(o-tolyl)guanidine (1:4)	95976-70-8	Intentional addition / 1,000ppm	chemical products
19217	(4R,5S,6S)-3-[[[3S,5S)-5-(N,N-Dimethylcarbamoyl)-1-(4-nitrobenzyloxy)carbonyl]pyrrolidine-3-yl]sulfanyl-6-[[1(R)-1-hydroxyethyl]-4-methyl-7-oxo-1-azabicyclo[3.2.0]hepta-2-ene-2-carboxylic acid 4-nitrobenzyl ester	96036-02-1	Contains (regardless of intentional or impurities)	chemical products
19218	Naphthalenesulfonic acid, dinonyl-, barium salt, basic, overbased	96041-58-6	Intentional addition / 1,000ppm	chemical products
19219	Nicotinic polacrilix	96055-45-7	Contains (regardless of intentional or impurities)	chemical products
19220	Vanadium, butyl phosphite oxo complexes	96152-59-9	Intentional addition / 1%	chemical products
19221	Iodonium, bis(4-dodecylphenyl)-, branched and linear, hexafluoroantimonate(1-)	96195-78-7	Contains (regardless of intentional or impurities)	chemical products
19222	Chromate(5-), bis[3-carboxy-1-[4-[[6-[[2-carboxyphenyl]azo]-5-hydroxy-7-sulfo-2-naphthalenyl]amino]-6-[[4-[[4-sulfonylphenyl]azo]phenyl]amino]-1,3,5-triazin-2-yl]pyridiniumato(5-)]-, pentasodium	96293-54-8	Contains (regardless of intentional or impurities)	chemical products
19223	Strychnidin-10-one, mono[[T(4)-tetraiodobismuthate(1-)]	96322-46-2	Contains (regardless of intentional or impurities)	chemical products
19224	Antimonate(1-), pentafluoro[[2,2'-oxybis(ethanolato)](1-)-O]-, hydrogen, compound with 2,6-diethylbenzamine (1:1)	96342-74-4	Contains (regardless of intentional or impurities)	chemical products
19225	Chromate(5-), [3-carboxy-1-[4-[[6-[[2-carboxyphenyl]azo]-5-hydroxy-7-sulfo-2-naphthalenyl]amino]-6-[[4-[[4-sulfonylphenyl]azo]phenyl]amino]-1,3,5-triazin-2-yl]pyridiniumato(5-)]][2-[[6-[[4-chloro-6-[[4-[[4-sulfonylphenyl]azo]phenyl]amino]-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(4-)]-, pentasodium	96395-82-9	Contains (regardless of intentional or impurities)	chemical products
19226	(1-Aminoethylidene)aminoformic acid 4-nitrobenzyl ester	96405-08-2	Contains (regardless of intentional or impurities)	chemical products
19227	4-[2-[5-(Trichloromethyl)-1,3,4-oxadiazol-2-yl]vinyl]phenol	96405-52-6	Contains (regardless of intentional or impurities)	chemical products
19228	3,8,10,12-Tetraoxa-9,11-distannahexadeca-5,14-dien-16-oic acid, 9,9,11,11-tetrabutyl-4,7,13-trioxo-, ethyl ester, (5Z,14Z)	96407-98-6	Intentional addition / 1,000ppm	chemical products
19229	3,8,10,12-Tetraoxa-9,11-distannahexadeca-5,14-dien-16-oic acid, 9,9,11,11-tetrabutyl-2-methyl-4,7,13-trioxo-1-methylethyl ester, (Z,Z)	96407-99-7	Intentional addition / 1,000ppm	chemical products
19230	Cobaltate(2-), tris[ethanedioato(2-)-O,O]-, tripotassium, dihydrate, (OC-6-11)-	96413-15-9	Intentional addition / 1%	chemical products
19231	Cobaltate(3-), tris[ethanedioato(2-)-O,O]-, tripotassium, dihydrate, (OC-6-11)-	96413-16-0	Intentional addition / 1%	chemical products
19232	[1R-(1.alpha.,4.alpha.,4b.alpha.,7.beta.,10.alpha.)]-Tributyl[[1-(1,2,3,4,4a,4b,5,6,7,9,10,10a-dodecahydro-1,4a,7-trihydroxy-7-vinyl-1-phenanthryl)carbonyl]oxystannane	96446-11-6	Contains (regardless of intentional or impurities)	chemical products
19233	Pyridaben	96489-71-3	Contains (regardless of intentional or impurities)	chemical products
19234	Amines, C12-14-tert-alkyl, bis[2,4-dihydro-4-[[2-hydroxy-5-(methylsulfonyl)-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-), (1:1)	96508-11-1	Contains (regardless of intentional or impurities)	chemical products
19235	Amines, C12-24-tert-alkyl, bis[4-[[5-(1,1-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-), (1:1)	96508-12-2	Contains (regardless of intentional or impurities)	chemical products
19236	Strychnidin-10-one, mono[[R-(R*)]-alpha-(1,3-benzodioxol-5-yl)hydroxymethyl]-1,3-dihydro-1,3-dioxo-2H-isindole-2-acetate	96561-37-4	Contains (regardless of intentional or impurities)	chemical products
19237	Strychnidin-10-one, mono[[S-(R*)]-alpha-(1,3-benzodioxol-5-yl)hydroxymethyl]-1,3-dihydro-1,3-dioxo-2H-isindole-2-acetate	96561-42-1	Contains (regardless of intentional or impurities)	chemical products
19238	Copper, 3,3'-[(3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diyl)bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulfonate] morpholine ammonium lithium sodium complexes	96591-22-9	Intentional addition / 1,000ppm	chemical products
19239	2,4,6-Trifluorobenzonitrile	96606-37-0	Intentional addition	chemical products
19240	Tridecane, tetrachloro-	96621-01-1	1,000ppm	chemical products
19241	Strychnidin-10-one, (S)-alpha-(acetylamino)-2-dibenzofuranpropanoate	96680-59-0	Contains (regardless of intentional or impurities)	chemical products
19242	Sulfuric acid, reaction products with D-glucose and chromic acid (H2Cr2O7) disodium salt, sodium salts	96690-54-9	Contains (regardless of intentional or impurities)	chemical products
19243	Tar acids, distillation residues	96690-55-0	Contains (regardless of intentional or impurities)	chemical products
19244	Zirconium, acetate butyl alcohol C16-18-fatty acid ethyl acetoacetate complexes	96690-79-8	Contains (regardless of intentional or impurities)	chemical products
19245	Zirconium, acetate C16-18-fatty acid ethyl acetoacetate propyl alcohol complexes	96690-80-1	Contains (regardless of intentional or impurities)	chemical products
19246	Zirconium, butyl alcohol C16-18-fatty acid ethyl acetoacetate complexes	96690-81-2	Contains (regardless of intentional or impurities)	chemical products
19247	Zirconium, C16-18-fatty acid ethyl acetoacetate propyl alcohol complexes	96690-82-3	Contains (regardless of intentional or impurities)	chemical products
19248	2,3,4-Tetrabromobiphenyl	97038-99-8	Intentional addition / 1,000ppm	chemical products
19249	Cobalt dithiocyanate	97126-35-7	Intentional addition / 1%	chemical products
19250	Dichloro(1,2-eta)-cyclohexene]platinum	97158-13-9	Contains (regardless of intentional or impurities)	chemical products
19251	Barium hexachlorosilicate(2-)	97158-14-0	Contains (regardless of intentional or impurities)	chemical products
19252	Barium hexabromosilicate(2-)	97158-16-2	Contains (regardless of intentional or impurities)	chemical products
19253	Barium diuron(3+) octaacetate	97158-26-4	Contains (regardless of intentional or impurities)	chemical products
19254	Chromate(7-), bis[1-[4-[[3-(acetylamino)-4-[(4,8-disulfo-2-naphthalenyl)azo]phenyl]amino]-6-[[6-[[2-carboxyphenyl]azo]-5-hydroxy-7-sulfo-2-naphthalenyl]amino]-1,3,5-triazin-2-yl]-3-carboxypyridiniumato(6-)]-, heptasodium	97158-56-0	Contains (regardless of intentional or impurities)	chemical products
19255	Triammonium bis[N,N-bis(carboxymethyl)glycinate(3-)-N,O,O']ferrate(3-)	97171-69-2	1%	chemical products
19256	Hydrogen [4-hydroxy-5-[(2-hydroxy-1-naphthyl)azo]benzene-1,3-disulphonato(4-)]chromate(1-)	97171-70-5	Contains (regardless of intentional or impurities)	chemical products
19257	Europium bis(thioborate)	97171-72-7	1%	chemical products
19258	Bis(2-methyl-2-propenoato-O)oxozirconium	97171-79-4	Contains (regardless of intentional or impurities)	chemical products
19259	Silver alloy, Ag,Cu,Pd,Sn	97198-18-0	Contains (regardless of intentional or impurities)	chemical products
19260	C.I. Acid Brown 415	97199-27-4	1,000ppm	chemical products
19261	p-[[Bis(dimethylamino)-alpha-[4-(ethylamino)-1-naphthyl]benzhydrylium tricopper(1+)] hexa(cyano-o)ferrate(4-)	97211-69-3	Intentional addition / 1,000ppm	chemical products
19262	Zirconium(2+) bis[2-(2,4,5,7-tetrabromo-3,6-dihydroxyxanthene-9-yl)-3,4,5,6-tetrachlorobenzoate]	97235-50-2	Contains (regardless of intentional or impurities)	chemical products
19263	Cadmium diisobutyl maleate	97259-82-0	Contains (regardless of intentional or impurities)	chemical products
19264	2,2-Dibutyltetrahydro-4,6,8-trimethyl-4H-1,3,6,2-dioxastannocine	97259-90-0	Contains (regardless of intentional or impurities)	chemical products
19265	Barium isobutyl maleate	97280-67-6	Contains (regardless of intentional or impurities)	chemical products
19266	Tetrasodium [bis[[[4-[[2-(sulphoxy)ethyl]sulphonyl]phenyl]amino]sulphonyl]-29H,31H-phthalocyaninedisulphonato(6-)-N29,N30,N31,N32]nickelate(4-)	97280-68-7	Contains (regardless of intentional or impurities)	chemical products
19267	3H-Indolium, 2-[2-(2,3-dihydro-2-methyl-1H-indol-1-yl)ethenyl]-1,3,3-trimethyl-, cyano phosphate cuprate ferrate complexes	97280-84-7	Intentional addition / 1,000ppm	chemical products
19268	Cyclohexachloro(mu-N-methyl-[N-(perfluoroethylsulphonyl)]glycinate-O1,O1)]di-mu-hydroxytrichromium	97298-47-0	Contains (regardless of intentional or impurities)	chemical products
19269	Beryllium oxide	97330-34-2	Contains (regardless of intentional or impurities)	chemical products
19270	Hydrogen bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-), compound with 2-(dodecylamino)ethanol (1:1)	97338-20-0	Contains (regardless of intentional or impurities)	chemical products
19271	Hydrogen bis[2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-), compound with 2-(dodecylamino)ethanol (1:1)	97338-21-1	Contains (regardless of intentional or impurities)	chemical products
19272	Trisodium bis[6-benzamido-4-hydroxy-3-[(2-hydroxy-3,5-dinitrophenyl)azo]naphthalene-2-sulphonato(3-)]chromate(3-)	97338-22-2	Contains (regardless of intentional or impurities)	chemical products
19273	Hydrogen bis[2-[[5-(amino)phenyl]-2-hydroxyphenyl]azo]-3-oxo-N-phenylbutylamidato(2-)]cobaltate(1-), compound with 3-[[2-(ethylthio)oxy]propylamine (1:1)	97338-24-4	Intentional addition / 1%	chemical products
19274	Trisodium bis[7-benzamido-4-hydroxy-3-[(2-hydroxy-3,5-dinitrophenyl)azo]naphthalene-2-sulphonato(3-)]chromate(3-)	97338-25-5	Contains (regardless of intentional or impurities)	chemical products
19275	Chromate(1-), bis[3-[[4,5-dihydro-4-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamidato(2-)]-, hydrogen, compound with 2-ethyl-1-hexanamine (1:1)	97338-26-6	Contains (regardless of intentional or impurities)	chemical products
19276	Borate(1-), tetrafluoro-, ammonium, reaction products with silica	97358-65-1	1%	chemical products
19277	Copper, [[29H,31H-phthalocyaninetetrayl tetrathiocyanato(2-)-N29,N30,N31,N32]-, reaction products with sodium sulfide (Na2Sx)	97358-68-4	Intentional addition / 1,000ppm	chemical products
19278	Octaaluminum barium tridecaoxide	97358-83-3	Contains (regardless of intentional or impurities)	chemical products
19279	Barium iron titanium zinc oxide	97358-84-4	Contains (regardless of intentional or impurities)	chemical products
19280	Thulium tribromate	97375-20-7	1%	chemical products
19281	Ammonium yttrium(3+) disulphate	97375-22-9	1%	chemical products
19282	Zirconium, 4,5-dihydro-5-oxo-1-(4-sulfonylphenyl)-4-[[4-sulfonylphenyl]azo]-1H-pyrazole-3-carboxylate complexes	97375-39-8	Contains (regardless of intentional or impurities)	chemical products
19283	Bis(tert-decanoyloxy)diethylstannane	97392-78-4	Contains (regardless of intentional or impurities)	chemical products
19284	Rhodium(3+) neodecanoate	97392-79-5	Contains (regardless of intentional or impurities)	chemical products
19285	Neodecanoic acid, platinum salt	97392-80-8	Contains (regardless of intentional or impurities)	chemical products
19286	Chromate(3-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]-, trihydrogen, compound with N,N'-di(phenyl, o-tolyl and xylyl)guanidine (3:1)	97392-82-0	Contains (regardless of intentional or impurities)	chemical products
19287	Copper, 2-[2-(3-aminopropoxy)ethoxy]ethanol N-(4-C7-17-branched alkylphenyl)-1-[[2-methoxy-5-methyl-4-phenylazo]phenyl]azo]-2-naphthalenamine complexes	97392-83-1	Intentional addition / 1,000ppm	chemical products
19288	Trihydrogen [2-[[[3-hydroxy-4-[[1-hydroxy-3-sulpho-7-(3-sulpho)amino]-2-naphthyl]azo]phenyl]azo]phenyl]-6-methyl-7-benzothiazolesulphonato(5-)cuprate(3-)	97403-79-7	Intentional addition / 1,000ppm	chemical products
19289	Sodium [2,4-dihydro-4-[[2-hydroxyphenyl]azo]-2-phenyl-3H-pyrazol-3-onato(2-)]][2-[[4,5-dihydro-5-oxo-1-(4-sulphamoylphenyl)-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)	97403-81-1	Contains (regardless of intentional or impurities)	chemical products
19290	Tribarium citrate	97403-84-4	Contains (regardless of intentional or impurities)	chemical products
19291	Terbium tribromate	97404-20-1	1%	chemical products
19292	[[N,N'-[29H,31H-Phthalocyaninetriyltris(sulphonyl)amino-3-phenylene]tris(3-oxobutylamido)](2-)-N29,N30,N31,N32]nickel	97404-21-2	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
19293	[N,N',N'',N''']-[29H,31H-phthalocyaninetetra]tetraakis(sulphonylimino-3-phenylene)trikakis(3-oxobutylamido)2-]-N29,N30,N31,N32nickel	97404-22-3	Contains (regardless of intentional or impurities)	chemical products
19294	1,1'-[isopropylidene]bis[3,5-dibromo-4-(2,3-dibromo-2-methylpropoxy)benzene]	97416-84-7	1,000ppm	chemical products
19295	Chromate(2-), [2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-one(2-)]-[4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-6-[(1-oxo-2-propenyl)amino]-2-naphthalenesulfonato(3-)]-, dihydrogen	97416-91-6	Contains (regardless of intentional or impurities)	chemical products
19296	Tetrahydrogen [3-[[6-[[4-chloro-6-(o-toluidino)-1,3,5-triazin-2-yl]amino]-1-hydroxy-3,6-disulpho-2-naphthyl]azo]-4-hydroxy]naphthalene-1,5-disulphonato(6-)]cuprate(4-)	97416-92-7	Intentional addition / 1,000ppm	chemical products
19297	Tetrahydrogen [3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]-[3-hydroxy-4-[(2-hydroxy-6-sulpho-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(4-)]chromate(4-)	97416-93-8	Contains (regardless of intentional or impurities)	chemical products
19298	Tetrasodium [3-hydroxy-4-[(2-hydroxy-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]-[3-hydroxy-4-[(2-hydroxy-6-sulpho-1-naphthyl)azo]-7-nitronaphthalene-1-sulphonato(4-)]chromate(4-)	97416-94-9	Contains (regardless of intentional or impurities)	chemical products
19299	Manganese, 1,2-ethanedithiolbis(carbamodithioate) copper iron zinc complexes	97434-80-5	Contains (regardless of intentional or impurities)	chemical products
19300	Molybdenum, bis(C8-18 and C8-18-unsaturated alkyl)carbamodithioate oxo thio complexes	97434-81-6	1,000ppm	chemical products
19301	Molybdenum, bis(C11-15 and C11-15-unsaturated alkyl)carbamodithioate oxo thio complexes	97434-82-7	1,000ppm	chemical products
19302	Molybdenum, bis(C14-18 and C14-18-unsaturated alkyl)carbamodithioate oxo thio complexes	97434-83-8	1,000ppm	chemical products
19303	Zirconium, dipropylene glycol hydroxy isobutyl alcohol neodecanoate propionate cobalt complexes	97434-88-3	Contains (regardless of intentional or impurities)	chemical products
19304	Zirconium, dipropylene glycol hydroxy isobutyl alcohol neodecanoate propionate cobalt complexes	97434-89-4	Contains (regardless of intentional or impurities)	chemical products
19305	Zirconium, dipropylene glycol hydroxy isobutyl alcohol propionate tert-decanoate cobalt complexes	97434-90-7	Contains (regardless of intentional or impurities)	chemical products
19306	Decaaluminum barium hexadecaoxide	97435-20-6	Contains (regardless of intentional or impurities)	chemical products
19307	Diiron nickel zinc tetraoxide	97435-21-7	Contains (regardless of intentional or impurities)	chemical products
19308	Barium tris(metasilicato(2-))dioxodizirconate(2-)	97435-22-8	Contains (regardless of intentional or impurities)	chemical products
19309	Manganese disilver pentoxide	97435-23-9	Contains (regardless of intentional or impurities)	chemical products
19310	Chromate(4-), [6-[(2-bromo-1-oxo-2-propenyl)amino]-4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenesulfonato(3-)]-[4-[[6-[(2-bromo-1-oxo-2-propenyl)amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, tetrasodium	97467-62-4	Contains (regardless of intentional or impurities)	chemical products
19311	Chromate(4-), [6-[[2,3-dibromo-1-oxopropyl)amino]-4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenesulfonato(3-)]-[4-[[6-[(2,3-dibromo-1-oxopropyl)amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, tetrasodium	97467-63-5	Contains (regardless of intentional or impurities)	chemical products
19312	Benzenesulfonic acid, dodecyl-, zinc salt, basic	97467-81-7	Intentional addition / 1%	chemical products
19313	Tricosanoic acid, barium salt, basic	97468-35-4	Intentional addition / 1,000ppm	chemical products
19314	Isooctanoic acid, tin(2+) salt	97485-46-6	1,000ppm	chemical products
19315	Distillates (petroleum), hydrocracked solvent-refined light	97488-73-8	Contains (regardless of intentional or impurities)	chemical products
19316	Distillates (petroleum), solvent-refined hydrogenated heavy	97488-74-9	Contains (regardless of intentional or impurities)	chemical products
19317	Ferrite substances, magnetoplumbite-type, barium-cobalt-titanium	97488-85-2	Contains (regardless of intentional or impurities)	chemical products
19318	Lubricating oils (petroleum), C18-27, hydrocracked solvent-dewaxed	97488-95-4	Contains (regardless of intentional or impurities)	chemical products
19319	Naphtha (petroleum), solvent-refined hydrodesulfurized heavy	97488-96-5	Contains (regardless of intentional or impurities)	chemical products
19320	[alpha-[2-(2-Amino-1-(2-hydroxyphenyl)-2-oxoethyl)amino]ethyl]amino]-2-hydroxybenzeneacetato(3-)]iron	97552-71-1	1%	chemical products
19321	[mu-[Ethane-1,2-diolato(2-)-O,O',O,O']bis(ethane-1,2-diolato(2-)-O,O')dioxodivanadium	97552-72-2	Intentional addition / 1%	chemical products
19322	Spinel, cobalt manganese black	97553-53-2	Contains (regardless of intentional or impurities)	chemical products
19323	4-Chlorobenzyltriphenylphosphonium tetrafluoroborate	97559-21-2	Contains (regardless of intentional or impurities)	chemical products
19324	Barium polysulfide	97560-32-2	Intentional addition	chemical products
19325	Calcium dichlorotrioxotricuprate(2-)	97592-60-4	Intentional addition / 1,000ppm	chemical products
19326	Chromium, formaldehyde-naphthalenesulfonic acid reaction product sulfate complexes	97592-67-1	1,000ppm	chemical products
19327	Cobaltate(3-), bis[4-hydroxy-3-[(2-hydroxy-5-nitrophenyl)azo]-7-[[3-(phosphonophenyl)amino]-2-naphthalenesulfonato(3-)]-, ammonium sodium	97592-68-2	Intentional addition / 1%	chemical products
19328	Cuprate(2-), [29H,31H-phthalocyaninedisulfonato(4-)-N29,N30,N31,N32]-, dihydrogen, compounds with N,N'-bis(phenyl and o-tolyl and xylyl)guanidine (1,2)	97592-69-3	Intentional addition / 1,000ppm	chemical products
19329	Cuprate(2-), [29H,31H-phthalocyaninedisulfonato(4-)-N29,N30,N31,N32]-, sodium, compound with N,N'-bis(2-methylphenyl)guanidine and N,N'-diphenylguanidine	97592-70-6	Intentional addition / 1,000ppm	chemical products
19330	Cuprate(3-), [29H,31H-phthalocyaninetrisulfonato(5-)-N29,N30,N31,N32]-, trihydrogen, compounds with N,N'-bis(phenyl and o-tolyl and xylyl)guanidine (1,3)	97592-71-7	Intentional addition / 1,000ppm	chemical products
19331	Terpineol, sulfurized, rhodium salts	97592-94-4	1%	chemical products
19332	2-Methylbutyl (2,4,5-trichlorophenoxy)acetate	97635-44-4	Intentional addition / 1,000ppm	chemical products
19333	Sodium [5-[[1,2-dihydro-4-hydroxy-2-oxo-3-quinolyl]azo]-4-hydroxybenzene-1,3-disulphonato(4-)]chromate(1-)	97659-24-0	Contains (regardless of intentional or impurities)	chemical products
19334	Bis(acrylate-O)hydroxychromium	97659-40-0	1,000ppm	chemical products
19335	Chlorophyllins, copper-sodium	97659-67-1	Intentional addition / 1,000ppm	chemical products
19336	Aluminum, [29H,31H-phthalocyaninedisulfonato(4-)-N29,N30,N31,N32]cuprate(2-) complexes	97660-26-9	Intentional addition / 1,000ppm	chemical products
19337	Cobalt, 5-(2-carboxybenzoyl)-2-hydroxybenzenediazonium-N-(2-chlorophenyl)-3-oxobutanamide reaction product complexes	97660-39-4	Intentional addition / 1%	chemical products
19338	Cobalt, 2,4-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-one complexes, compounds with 3-(C8-18-alkylamino)butanoic acid	97660-40-7	Intentional addition / 1%	chemical products
19339	Copper, N-(4-C7-17-branched alkylphenyl)-1-[[2-methoxy-5-methyl-4-(phenyl)azo]phenyl]azo]-2-naphthalenamine 2-ethyl-1-hexanamine complexes	97660-41-8	Intentional addition / 1,000ppm	chemical products
19340	Copper, bis(8-quinolinolato-N1,O8)-, reaction products with C8-10-branched fatty acids, tert-decanoic acid, nickel(2+) diacetate, nickel(2+) carbonate (1:1) and nickel hydroxide	97660-42-9	Contains (regardless of intentional or impurities)	chemical products
19341	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfide [[4-[[2-(sulfoxyethyl)sulfonyl]phenyl]amino]sulfonyl derivatives, sodium salts	97660-43-0	Intentional addition / 1,000ppm	chemical products
19342	Phenothiazin-5-ium, 3,7-bis(dimethylamino)-, chloride, reaction products with chromic acid (H2CrO7)	97660-43-4	Contains (regardless of intentional or impurities)	chemical products
19343	Sulfuric acid, reaction products with colemanite (CaH(BO2)3.2H2O), by-products from	97660-73-6	1%	chemical products
19344	Zirconium, 2-(2-butoxyethoxy)ethanol C9-11-branched fatty acids aluminum complexes	97660-76-9	Contains (regardless of intentional or impurities)	chemical products
19345	Zirconium, chloro hydroxy propylene glycol aluminum complexes	97660-77-0	Contains (regardless of intentional or impurities)	chemical products
19346	Benzene, C9-13-alkyl derivatives, distillation residues, sulfonated, barium salts	97675-23-5	Intentional addition / 1,000ppm	chemical products
19347	Magnetoplumbite, barium titanium zinc brown	97675-41-7	Contains (regardless of intentional or impurities)	chemical products
19348	Hydrocarbons, C16-20, hydrotreated middle distillate, distillation lights	97675-85-9	Contains (regardless of intentional or impurities)	chemical products
19349	Hydrocarbons, C12-20, hydrotreated paraffinic, distillation lights	97675-86-0	Contains (regardless of intentional or impurities)	chemical products
19350	Hydrocarbons, C17-30, hydrotreated solvent-deasphalted atmospheric distillation residue, distillation lights	97675-87-1	Contains (regardless of intentional or impurities)	chemical products
19351	Sodium [mu-[4-[[5-[[5-chloro-2-hydroxyphenyl]azo]-2,4-dihydroxyphenyl]azo]-3-hydroxy-7-nitronaphthalenyl]azo]-5-sulphonato(5-)]dihydroxydichromate(1-)	97692-41-6	Contains (regardless of intentional or impurities)	chemical products
19352	2,8,10,16,17-Hexaaza-5,13,20-triaza-1,9-diborabicyclo[7.7.7]tricosane	97692-53-0	1%	chemical products
19353	Hydrocarbons, C26-35, aromatic-rich	97722-04-8	Contains (regardless of intentional or impurities)	chemical products
19354	Hydrocarbons, C11-40, hydrotreated solvent-deasphalted distillation residue, vacuum distillation lights	97722-06-0	Contains (regardless of intentional or impurities)	chemical products
19355	Hydrocarbons, C11-17, solvent-extracted light naphthenic	97722-08-2	Contains (regardless of intentional or impurities)	chemical products
19356	Hydrocarbons, C13-27, solvent-extracted light naphthenic	97722-09-3	Contains (regardless of intentional or impurities)	chemical products
19357	Hydrocarbons, C14-29, solvent-extracted light naphthenic	97722-10-6	Contains (regardless of intentional or impurities)	chemical products
19358	Raffinates (petroleum), steam-cracked C4 fraction cuprous ammonium acetate extraction, C3-5 and C3-5 unsaturated, butadiene-free	97722-19-5	Contains (regardless of intentional or impurities)	chemical products
19359	Sulfuric acid, manganese(4+) salt (2:1)	97730-66-0	Contains (regardless of intentional or impurities)	chemical products
19360	Boron, bis(acetato-kappa O)[9,10-difluoro-2,3-dihydro-3-methyl-7-(oxo-kappa O)-7H-pyrrolo[1,2,3-de]-1,4-benzoxazine-6-carboxylato-kappa O]6-, (T-4)-	97746-91-3	1%	chemical products
19361	D-Gluconic acid, antimony(5+) sodium salt (1:1:1)	97763-70-7	Contains (regardless of intentional or impurities)	chemical products
19362	Camphor tree, extract, sulfurized, rhodium salts	97765-85-6	1%	chemical products
19363	Eucalyptus, extract, sulfurized, rhodium salts	97765-77-0	1%	chemical products
19364	Lavender, lavandula latifolia, extract, sulfurized, rhodium salts	97766-12-6	1%	chemical products
19365	Lavender, lavandula officinalis, extract, sulfurized, rhodium salts	97766-15-9	1%	chemical products
19366	Rosemary, rosmarinus officinalis, extract, sulfurized, rhodium salts	97766-32-0	1%	chemical products
19367	Arsinic acid, dimethyl-, ammonium salt	97791-83-8	Contains (regardless of intentional or impurities)	chemical products
19368	1-Butene, 4-bromo-3,3-dimethyl-	97797-99-4	1,000ppm	chemical products
19369	Dihydrogen bis[DL-aspartato(2-)-N,O1,O4]ferrate(2-)	97806-24-1	1%	chemical products
19370	Carboxylic acids, di-, C2-8, reaction products with boric acid, C12-20 and C12-20-unsaturated fatty acids, diethanolamine, ethanolamine and triethanolamine	97808-11-2	1%	chemical products
19371	Fatty acids, C12-20 and C12-20-unsaturated, reaction products with benzoic acid, boric acid, diethanolamine, ethanolamine, salicylic acid and triethanolamine	97808-25-8	1%	chemical products
19372	Fatty acids, C3-24 and C10-18-unsaturated, reaction products with boric acid, diethanolamine, ethanolamine and triethanolamine	97808-26-9	1%	chemical products
19373	Fatty acids, tallow, reaction products with boric acid, diethanolamine, ethanolamine, and triethanolamine	97808-37-2	1%	chemical products
19374	Chromium, hydroxide 2-hydroxy-5-[(5-sulfo-2-naphthalenyl)azo]benzoate sulfate sodium complexes	97808-72-5	1,000ppm	chemical products
19375	Chromium, hydroxide 2-hydroxy-5-[(8-sulfo-2-naphthalenyl)azo]benzoate sulfate sodium complexes	97808-73-6	1,000ppm	chemical products
19376	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-[[4-amino-6-chloro-1,3,5-triazin-2-yl)amino]phenyl]amino]sulfonyl aminosulfonyl sulfo derivatives, sodium salts	97808-74-7	Intentional addition / 1,000ppm	chemical products
19377	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-[[4-amino-6-chloro-1,3,5-triazin-2-yl)amino]-4-sulfo]phenyl]amino]sulfonyl aminosulfonyl sulfo derivatives, sodium salts	97808-75-8	Intentional addition / 1,000ppm	chemical products
19378	Copper, [29H,31H-phthalocyaninetetra]tetrachlorido(2-)-N29,N30,N31,N32]-, reaction products with 2-[4-[[2-aminoethyl)amino]-6-chloro-1,3,5-triazin-2-yl)amino]-1,4-benzenedisulfonic acid and ammonium hydroxide, sodium salts	97808-76-9	Intentional addition / 1,000ppm	chemical products
19379	Cuprate(3-), [4-amino-6-[[6-[[4-amino-6-chloro-1,3,5-triazin-2-yl)amino]-2-hydroxy-4-sulfo-1-naphthalenyl]azo]-5-hydroxy-1,3-naphthalenesulfonato(5-)]-, potassium sodium	97808-77-0	Intentional addition / 1,000ppm	chemical products
19380	2-Naphthalenesulfonic acid, reaction products with chromium hydroxide sulfate and formaldehyde	97808-94-1	1,000ppm	chemical products
19381	Phosphoric acid, reaction products with (T-4)-disodium tungstate, lithium salts	97808-99-6	1%	chemical products
19382	Sulfurous acid, monosodium salt, reaction products with chromium hydroxide sulfate, formaldehyde and 4,4'-sulfonylbis[phenol]	97809-02-4	1,000ppm	chemical products
19383	Zirconium, carbonate tartrate ammonium copper complexes	97809-03-5	Contains (regardless of intentional or impurities)	chemical products
19384	Molybdenum vanadium oxide (Mo2V2O11)	97812-63-0	Intentional addition / 1,000ppm	chemical products
19385	Pirritamide dihydrochloride	97828-37-0	Intentional addition	chemical products
19386	Zirconium(4+) tetra(2-(4,5-dibromo-3,6-dihydroxy)xanthen-9-yl)benzoate	97862-03-8	Contains (regardless of intentional or impurities)	chemical products
19387	Chromium, acetate formate hydroxy sulfate complexes	97862-11-8	1,000ppm	chemical products
19388	Chromium, acetate hydroxy oxalate sulfate complexes	97862-12-9	1,000ppm	chemical products
19389	Chromium, acetate hydroxy sulfate complexes	97862-13-0	1,000ppm	chemical products
19390	Chromium, formate hydroxy sulfate complexes	97862-14-1	Contains (regardless of intentional or impurities)	chemical products
19391	Zinc, 3-acetyl-4-hydroxy-6-methyl-2H-pyran-2-one barium complexes	97862-22-1	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
19392	Sulfuric acid copper(2+) salt (1:1), reaction products with 4-[(2,4-dinitrophenyl)amino]phenol, sodium hydroxide and sodium sulfide (Na2Sx)	97862-46-9	Intentional addition / 1,000ppm	chemical products
19393	Amines, rosin, compounds with 9-(2-carboxyphenyl)-3,6-bis(diethylamino)xanthylium chloride and disodium hydrogen bis[4-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3-hydroxy-1-naphthalenesulfonato(3-)]chromate(3-)	97862-65-2	Contains (regardless of intentional or impurities)	chemical products
19394	Foots oil (petroleum), carbon-treated	97862-76-5	Contains (regardless of intentional or impurities)	chemical products
19395	Foots oil (petroleum), silicic acid-treated	97862-77-6	Contains (regardless of intentional or impurities)	chemical products
19396	Gas oils, hydrotreated	97862-78-7	Contains (regardless of intentional or impurities)	chemical products
19397	Hydrocarbons, C27-42, dearomatized	97862-81-2	Contains (regardless of intentional or impurities)	chemical products
19398	Hydrocarbons, C17-30, hydrotreated distillates, distillation lights	97862-82-3	Contains (regardless of intentional or impurities)	chemical products
19399	Hydrocarbons, C27-45, naphthene vacuum distillation	97862-83-4	Contains (regardless of intentional or impurities)	chemical products
19400	Petrolatum (petroleum), carbon-treated	97862-87-0	Contains (regardless of intentional or impurities)	chemical products
19401	Petrolatum (petroleum), silicic acid-treated	97862-98-1	Contains (regardless of intentional or impurities)	chemical products
19402	Slack wax (petroleum), low-melting, carbon-treated	97863-04-2	Contains (regardless of intentional or impurities)	chemical products
19403	Slack wax (petroleum), low-melting, clay-treated	97863-05-3	Contains (regardless of intentional or impurities)	chemical products
19404	Slack wax (petroleum), low-melting, silicic acid-treated	97863-06-4	Contains (regardless of intentional or impurities)	chemical products
19405	Turpentine, oil, reaction products with boron trifluoride	97863-08-6	Contains (regardless of intentional or impurities)	chemical products
19406	Zirconium, butoxy[2-(2-methoxyethoxy)ethanolato][2-(2-methoxyethoxy)ethanolato-O]2(4-pentanedionato-O)2-	97890-93-2	Contains (regardless of intentional or impurities)	chemical products
19407	Triphenyltin terephthalate	97922-83-3	Contains (regardless of intentional or impurities)	chemical products
19408	Bis(isononanoato-O)oxozirconium	97925-91-2	Contains (regardless of intentional or impurities)	chemical products
19409	Glycine, N-(C12-22-alkylsulfonyl) derivatives, bis[2,2'-iminobis[ethanolato](2--O)O]borate(1-), compounds with diethanolamine	97925-96-7	1%	chemical products
19410	Extracts (petroleum), heavy naphtha solvent, clay-treated	97926-43-7	Contains (regardless of intentional or impurities)	chemical products
19411	Flue dust, silver-refining	97926-57-3	Contains (regardless of intentional or impurities)	chemical products
19412	Gas oils (petroleum), light vacuum, thermal-cracked hydrodesulfurized	97926-59-5	Contains (regardless of intentional or impurities)	chemical products
19413	Hydrocarbons, C27-45, dearomatized	97926-68-6	Contains (regardless of intentional or impurities)	chemical products
19414	Hydrocarbons, C20-58, hydrotreated	97926-70-0	Contains (regardless of intentional or impurities)	chemical products
19415	Hydrocarbons, C27-42, naphthene	97926-71-1	Contains (regardless of intentional or impurities)	chemical products
19416	Paraffin waxes (coal), brown-coal high-temperature tar, carbon-treated	97926-76-6	Contains (regardless of intentional or impurities)	chemical products
19417	Paraffin waxes (coal), brown-coal high-temperature tar, clay-treated	97926-77-7	Contains (regardless of intentional or impurities)	chemical products
19418	Paraffin waxes (coal), brown-coal high-temperature tar, silicic acid-treated	97926-78-8	Contains (regardless of intentional or impurities)	chemical products
19419	Benzoic acid, 2-hydroxy-, coupled with diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine and 5,5'-[5-hydroxy-1,3-phenylene]bis(oxy)bis[1,3-benzenediol], sodium salts	97952-82-4	Intentional addition	chemical products
19420	Benzoic acid, 2-hydroxy-, coupled with diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine and 5,5'-oxybis[1,3-benzenediol], sodium salts	97952-83-5	Intentional addition	chemical products
19421	Benzoic acid, 2-hydroxy-, coupled with diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine and 5,5'-[oxybis(5-hydroxy-3,1-phenylene)oxy]bis[1,3-benzenediol], sodium salts	97952-84-6	Intentional addition	chemical products
19422	Zirconium, carbonate tartrate ammonium complexes	97953-18-9	Contains (regardless of intentional or impurities)	chemical products
19423	Tetramolybdenum nitride	97953-19-0	Contains (regardless of intentional or impurities)	chemical products
19424	Hydrogen disodium bis[2-hydroxy-5-nitro-3-[[2-oxo-1-[(phenylamino)carbonyl]propyl]azo]benzenesulphonato(3-)]cobaltate(3-)	97975-95-6	Intentional addition / 1%	chemical products
19425	Diphenylboric acid ethanolamine	97987-95-6	1%	chemical products
19426	Trimethylol triester with boric acid, stereoisomer	97996-39-9	1%	chemical products
19427	5-[7-(Hydroxydimethylsilyl)-1,7-dicarbadodecaboran(12)-1-yl]-1,3,3,5,5-hexamethyltrisiloxan-1-ol	97999-31-0	1%	chemical products
19428	Bis[1,2,3,6-tetrahydro-2,6-dioxopyrimidine-4-carboxylato-N3,O4]manganese	97999-32-2	Contains (regardless of intentional or impurities)	chemical products
19429	Chromium(1+), bis[3-[[[4-[(5-chloro-2-hydroxyphenyl)azo]-3-hydroxy-2-naphthalenyl]carbonyl]amino]-N,N,N-trimethyl-1-propanaminiumato(2-)]-, chloride	98004-61-6	1,000ppm	chemical products
19430	5-[7-(3-Hydroxy-1,1,3,3-tetramethylsiloxy)-1,7-dicarbadodecaboran(12)-1-yl]-1,3,3,5,5-pentamethyl-1-phenyltrisiloxan-1-ol	98028-02-5	1%	chemical products
19431	7-Hydroxy-6,8-dioxo-3,11-diaza-7-boratridecane-1,13-diol	98027-03-8	1%	chemical products
19432	Dialuminum barium dicalcium hexaoxide	98027-16-3	Contains (regardless of intentional or impurities)	chemical products
19433	Flue dust, precious metal refining	98027-44-7	Contains (regardless of intentional or impurities)	chemical products
19434	Sulfonamides, C9-20 petroleum alkane, solvent-refined, chloro, N-(chlorinated solvent-refined C9-20 petroleum alkylsulfonyl), barium salts (2:1)	98072-62-9	Intentional addition / 1,000ppm	chemical products
19435	Sulfonamides, C11-25 petroleum alkane, hydrotreated, chloro, N-(chlorinated hydrotreated C11-25 petroleum alkylsulfonyl), barium salts (2:1)	98072-63-0	Intentional addition / 1,000ppm	chemical products
19436	1,3-Benzenediol, 5,5'-[(5-hydroxy-1,3-phenylene)bis(oxy)]bis-, coupled with diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine, sodium salt	98072-75-4	Intentional addition	chemical products
19437	1,3-Benzenediol, 5,5'-oxybis-, coupled with diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine, sodium salt	98072-76-5	Intentional addition	chemical products
19438	1,3-Benzenediol, 5,5'-[oxybis(5-hydroxy-3,1-phenylene)oxy]bis-, coupled with diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine, sodium salt	98072-77-6	Intentional addition	chemical products
19439	Chromite (Cr2FeO4), concentrate	98072-82-3	1,000ppm	chemical products
19440	Cuprate(4-), [4-amino-5-hydroxy-6-[[2-hydroxy-4-[[2-(sulfonyl)ethyl]sulfonyl]phenyl]azo]-3-[[4-[[2-(sulfonyl)ethyl]sulfonyl]phenyl]azo]-2,7-naphthalenedisulfonato(6-)]-, sodium	98072-83-4	Intentional addition / 1,000ppm	chemical products
19441	2,7-Naphthalenedisulfonic acid, 4-amino-5-hydroxy-, coupled with diazotized 2-(4-aminophenyl)-6-methyl[2,6-bibenzothiazole]-7-sulfonic acid, diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine and 5,5'-[5-hydroxy-1,3-phenylene]bis(oxy)bis[1,3-benzenediol], sodium salts	98072-95-8	Intentional addition	chemical products
19442	2,7-Naphthalenedisulfonic acid, 4-amino-5-hydroxy-, coupled with diazotized 2-(4-aminophenyl)-6-methyl[2,6-bibenzothiazole]-7-sulfonic acid, diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine and 5,5'-oxybis[1,3-benzenediol], sodium salts	98072-96-9	Intentional addition	chemical products
19443	2,7-Naphthalenedisulfonic acid, 4-amino-5-hydroxy-, coupled with diazotized 2-(4-aminophenyl)-6-methyl[2,6-bibenzothiazole]-7-sulfonic acid, diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine and 5,5'-[oxybis(5-hydroxy-3,1-phenylene)oxy]bis[1,3-benzenediol], sodium salts	98072-97-0	Intentional addition	chemical products
19444	2,7-Naphthalenedisulfonic acid, 4-amino-5-hydroxy-, coupled with diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine and 5,5'-[5-hydroxy-1,3-phenylene]bis(oxy)bis[1,3-benzenediol], sodium salts	98073-01-9	Intentional addition	chemical products
19445	2,7-Naphthalenedisulfonic acid, 4-amino-5-hydroxy-, coupled with diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine and 5,5'-oxybis[1,3-benzenediol], sodium salts	98073-02-0	Intentional addition	chemical products
19446	2,7-Naphthalenedisulfonic acid, 4-amino-5-hydroxy-, coupled with diazotized 3,3'-dimethoxy[1,1'-biphenyl]-4,4'-diamine and 5,5'-[oxybis(5-hydroxy-3,1-phenylene)oxy]bis[1,3-benzenediol], sodium salts	98073-03-1	Intentional addition	chemical products
19447	Tetraaluminum zirconium tetrachloride dodecahydroxide	98106-52-6	Contains (regardless of intentional or impurities)	chemical products
19448	Tetraaluminum zirconium trichloride tridecahydroxide	98106-53-7	Contains (regardless of intentional or impurities)	chemical products
19449	Octaaluminum zirconium pentachloride tricosahydroxide	98106-54-8	Contains (regardless of intentional or impurities)	chemical products
19450	Octaaluminum zirconium octachloride icosahydroxide	98106-55-9	Contains (regardless of intentional or impurities)	chemical products
19451	Gallium zinc triarsenide	98106-56-0	Contains (regardless of intentional or impurities)	chemical products
19452	Boric acid, B-(3-methylbutyl)-	98139-72-1	1%	chemical products
19453	Chromate(1-), [6-amino-5-[(2-hydroxy-4-nitrophenyl)azo]-1-naphthalenesulfonato(3-)]aqua[2,4-pentanedionato-O]2-, ammonium sodium	98171-55-2	Contains (regardless of intentional or impurities)	chemical products
19454	Chromate(2-), [6-amino-5-[(2-hydroxy-4-nitrophenyl)azo]-1-naphthalenesulfonato(3-)]hydroxy[2,4-pentanedionato-O]2-, ammonium sodium	98171-56-3	Contains (regardless of intentional or impurities)	chemical products
19455	Chromate(3-), bis[4-[4,5-dihydro-4-[(2-hydroxy-4-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, trihydrogen, compounds with N,N'-bis(phenyl) and tolyl and xylylguanidine	98171-57-4	Contains (regardless of intentional or impurities)	chemical products
19456	Chromate(3-), bis[4-[4,5-dihydro-4-[(2-hydroxy-5-nitrophenyl)azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(3-)]-, trihydrogen, compounds with N,N'-bis(phenyl) and tolyl and xylylguanidine	98171-58-5	Contains (regardless of intentional or impurities)	chemical products
19457	Chromate(3-), bis[3-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-4-hydroxybenzenesulfonato(3-)]-, trihydrogen, compounds with N,N'-bis(phenyl) and tolyl and xylylguanidine	98171-59-6	Contains (regardless of intentional or impurities)	chemical products
19458	Chromate(3-), bis[4-hydroxy-3-[[2-oxo-1-[(phenylamino)carbonyl]propyl]azo]benzenesulfonato(3-)]-, trihydrogen, compounds with N,N'-bis(phenyl) and tolyl and xylylguanidine	98171-60-9	Contains (regardless of intentional or impurities)	chemical products
19459	Chromium, 4-hydroxy-3-[(2-hydroxy-3,5-dinitrophenyl)azo]-6(or 7)-[[sulfomethyl]amino]-2-naphthalenesulfonate complexes, compounds with N,N'-bis(phenyl) and tolyl and xylylguanidine	98171-61-0	1,000ppm	chemical products
19460	Cuprate(2-), [(aminosulfonyl)-29H,31H-phthalocyaninedisulfonato(4-)-N29,N30,N31,N32]-, sodium	98171-63-2	Intentional addition / 1,000ppm	chemical products
19461	Zirconium, acetate lactate methacrylate complexes	98171-77-8	Contains (regardless of intentional or impurities)	chemical products
19462	Naphtha (petroleum), light steam-cracked, debenzenized, thermally treated	98219-46-6	Contains (regardless of intentional or impurities)	chemical products
19463	Naphtha (petroleum), light steam-cracked, thermally treated	98219-47-7	Contains (regardless of intentional or impurities)	chemical products
19464	Residues, steam cracked, thermally treated	98219-64-8	Contains (regardless of intentional or impurities)	chemical products
19465	Slimes and sludges, steel hardening	98219-71-7	Contains (regardless of intentional or impurities)	chemical products
19466	Perovskite-type crystals, barium strontium - An inorganic material formed by high temperature calcination of strontium oxide, barium oxide and titanium oxide. Ionic interdiffusion occurs to form a crystalline matrix of perovskite structure.	98246-90-3	Intentional addition	chemical products
19467	Benzonitrile, 2,4,5-trifluoro-	98349-22-5	Intentional addition	chemical products
19468	Strychnidin-10-one, mono(S)-[[3-(3-bromophenyl)methyl]sulfonyl]acetate	98392-15-5	Contains (regardless of intentional or impurities)	chemical products
19469	Thianaphthene-2-boronic acid	98437-23-1	1%	chemical products
19470	Benzofuran-2-boronic acid	98437-24-2	1%	chemical products
19471	1,1'-Ethyldienebis[4-(2,3-epoxypropoxy)benzene]	98460-24-3	Contains (regardless of intentional or impurities)	chemical products
19472	Copper, [dihydrogen 3-hydroxy-4-[(2-hydroxy-5-[[2-hydroxyethyl]sulfonyl]phenyl]azo)-2,7-naphthalenedisulfonato(2-)]-, hydrogen sulfate, tripotassium salt	98467-38-0	Intentional addition / 1,000ppm	chemical products
19473	Hydrogen [4-[4-(dimethylamino)-alpha-(3,6-disulphonato-1-naphthyl)benzylidene]cyclohexa-2,5-dien-1-ylidene]dimethylammonium, barium salt	98493-34-6	Contains (regardless of intentional or impurities)	chemical products
19474	Hydrogen [4-[4-(diethylamino)-alpha-(3,6-disulphonato-1-naphthyl)benzylidene]cyclohexa-2,5-dien-1-ylidene]ethylmethylammonium, barium salt	98493-36-8	Contains (regardless of intentional or impurities)	chemical products
19475	Boronic acid, B-[4-(methylthio)phenyl]-	98546-51-1	1%	chemical products
19476	Trisodium bis[4-[(5-acetyl-2,4-dihydroxyphenyl)azo]-3-hydroxy-7-nitronaphthalene-1-sulphonato(3-)]ferrate(3-)	98561-38-7	1%	chemical products
19477	Cuprate(4-), 5-triazin-2-ylamino)-2-(((2-hydroxy-3,5-disulfonyl)azo)2-sulfonyl)methylazo]benzoato(6-)-, tetrasodium salt	98654-21-8	Intentional addition / 1,000ppm	chemical products
19478	Chromate(1-), bis[3-[4-[[5-(1,1-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonato(2-)]-, hydrogen, compound with 2,2'-(dodecylimino)bis[ethano] (1:1)	98690-34-7	Contains (regardless of intentional or impurities)	chemical products
19479	L-Alanine, N-benzoyl-, compound with strychnidin-10-one (1:1), dihydrate	98748-11-9	Contains (regardless of intentional or impurities)	chemical products
19480	Formic acid, vanadium salt	98841-55-5	Intentional addition / 1%	chemical products
19481	Fosthiazate	98886-44-3	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
19581	Silicic acid (H4SiO4), zirconium(4+) salt (1:1), reaction products with ethoxytrimethylsilane	100402-98-0	Contains (regardless of intentional or impurities)	chemical products
19582	Silicic acid (H4SiO4), zirconium(4+) salt (1:1), reaction products with 3-(triethoxysilyl)-1-propanamine	100402-99-1	Contains (regardless of intentional or impurities)	chemical products
19583	Silicic acid (H4SiO4), zirconium(4+) salt (1:1), reaction products with trimethoxy[3-(oxiranylmethoxy)propyl]silane	100403-00-7	Contains (regardless of intentional or impurities)	chemical products
19584	Silicic acid (H6Si2O7), yttrium(3+) salt (1:2), cerium-doped	100403-01-8	1%	chemical products
19585	Sulfuric acid, calcium strontium salt, cerium and lithium and manganese-doped	100403-02-9	Contains (regardless of intentional or impurities)	chemical products
19586	Titanate(4-), oxobis(phosphato(3-))-, barium (1:2), uranium-doped	100403-10-9	Intentional addition / 1,000ppm	chemical products
19587	Vanadium yttrium oxide phosphate, dysprosium and europium-doped	100403-11-0	Intentional addition / 1%	chemical products
19588	Yttrium oxide silicate (Y2O3SiO4), cerium-doped	100403-12-1	1%	chemical products
19589	Castor oil, sulfated, salts with 9-(2-carboxyphenyl)-3,6-bis(diethylamino)xanthylum, 2-[3-(1,3-dihydro-1,3,3-trimethyl-2H-indol-2-ylidene)-1-propenyl]-1,1,3,3-trimethyl-3H-indolum and 9-[2-(ethoxycarbonyl)phenyl]-3,6-bis(diethylamino)xanthylum, aluminum barium salts	100403-18-7	Intentional addition / 1,000ppm	chemical products
19590	Fescue, Festuca elatior extract, copper salt	100403-36-9	Intentional addition / 1,000ppm	chemical products
19591	Lolium multiflorum, extract, copper salt	100403-50-7	Intentional addition / 1,000ppm	chemical products
19592	Orchard grass, extract, copper salt	100403-57-4	Intentional addition / 1,000ppm	chemical products
19593	Platinum(4+) 2,6,6-trimethylbicyclo[3.1.1]heptane-3-thiolate	100432-45-9	Contains (regardless of intentional or impurities)	chemical products
19594	Platinum(4+) 2,6,6-trimethylbicyclo[3.1.1]heptane-2-thiolate	100432-46-0	Contains (regardless of intentional or impurities)	chemical products
19595	Bicyclo[3.1.1]heptane-3-thiol, 2,6,6-trimethyl-, rhodium(3+) salt	100432-49-3	Contains (regardless of intentional or impurities)	chemical products
19596	Bicyclo[3.1.1]heptane-2-thiol, 2,6,6-trimethyl-, rhodium(3+) salt	100432-50-6	Contains (regardless of intentional or impurities)	chemical products
19597	Phenol, 2,2'-sulfinyl bis 4,6-dichloro-, compound with nicotine	100435-91-4	Contains (regardless of intentional or impurities)	chemical products
19598	Benzoic acid, 4-methyl-, barium salt, dihydrate	100444-33-5	Intentional addition / 1,000ppm	chemical products
19599	Magnesium, dibutyl-, reaction products with chromium oxide (CrO3), isopropyl alcohol titanium(4+) salt and silica	100468-44-8	Contains (regardless of intentional or impurities)	chemical products
19600	Dodecane, 1,1,1,2,12,12-hexachloro-	100525-30-2	1,000ppm	chemical products
19601	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-(cyclohexylamino)propyl]amino]sulfonyl derivatives	100545-46-8	Intentional addition / 1,000ppm	chemical products
19602	1-Heptene, 3-bromo-	100594-85-2	1,000ppm	chemical products
19603	9-Anthraceneboronic acid	100622-34-2	1%	chemical products
19604	Chromium boride (Cr2B3)	100629-17-2	1,000ppm	chemical products
19605	Residues, niobium oxide-tantalum oxide manufacturing, lime-neutralized	100656-50-6	Contains (regardless of intentional or impurities)	chemical products
19606	Slags, zinc-smelting, sodium containing	100656-51-7	Contains (regardless of intentional or impurities)	chemical products
19607	Residues, silver sludge-electrolysis zinc-precipitated, precious metal-containing	100656-52-8	Intentional addition / 1%	chemical products
19608	Residues, copper speiss acid leaching	100656-54-0	Contains (regardless of intentional or impurities)	chemical products
19609	Distillates (petroleum), carbon-treated light paraffinic	100683-97-4	Contains (regardless of intentional or impurities)	chemical products
19610	Distillates (petroleum), intermediate paraffinic, carbon-treated	100683-98-5	Contains (regardless of intentional or impurities)	chemical products
19611	Distillates (petroleum), intermediate paraffinic, clay-treated	100683-99-6	Contains (regardless of intentional or impurities)	chemical products
19612	Extracts (petroleum), light paraffinic distillate solvent, carbon-treated	100684-02-4	Contains (regardless of intentional or impurities)	chemical products
19613	Extracts (petroleum), light paraffinic distillate solvent, clay-treated	100684-03-5	Contains (regardless of intentional or impurities)	chemical products
19614	Extracts (petroleum), light vacuum, gas oil solvent, carbon-treated	100684-04-6	Contains (regardless of intentional or impurities)	chemical products
19615	Extracts (petroleum), light vacuum gas oil solvent, clay-treated	100684-05-7	Contains (regardless of intentional or impurities)	chemical products
19616	Petrolatum (petroleum), clay-treated	100684-33-1	Contains (regardless of intentional or impurities)	chemical products
19617	Residual oils (petroleum), carbon-treated solvent-dewaxed	100684-37-5	Contains (regardless of intentional or impurities)	chemical products
19618	Residual oils (petroleum), clay-treated solvent-dewaxed	100684-38-6	Contains (regardless of intentional or impurities)	chemical products
19619	Slack wax (petroleum), carbon-treated	100684-49-9	Contains (regardless of intentional or impurities)	chemical products
19620	Tar, coal, high-temperature, residues	100684-51-3	Contains (regardless of intentional or impurities)	chemical products
19621	Manganese, [[1,2-ethanediy]bis[carbamodithioato(2-)]-], mixture with [[1,2-ethanediy]bis[carbamodithioato(2-)]-]zinc and ethyl hydrogen phosphonate	100756-24-9	Contains (regardless of intentional or impurities)	chemical products
19622	Halosulfuron-methyl	100784-20-1	1%	chemical products
19623	Hydrocarbon oils, aromatic, mixed with polyethylene and polypropylene, pyrolyzed, light oil fraction	100801-63-6	Contains (regardless of intentional or impurities)	chemical products
19624	Hydrocarbon oils, aromatic, mixed with polyethylene, pyrolyzed, light oil fraction	100801-65-8	Contains (regardless of intentional or impurities)	chemical products
19625	Hydrocarbon oils, aromatic, mixed with polystyrene, pyrolyzed, light oil fraction	100801-66-9	Contains (regardless of intentional or impurities)	chemical products
19626	Tributyltin butylphenolate	100835-88-9	Contains (regardless of intentional or impurities)	chemical products
19627	(3R)-(+)-Tetrahydrofuranboronic acid diethanolamine ester	100858-40-0	1%	chemical products
19628	1H-Benz[de]isoquinoline-1,3(2H)-dione, 6-bromo-2-ethyl-	100874-09-7	Contains (regardless of intentional or impurities)	chemical products
19629	4-[N-(2-Amino-3-cyano-5-pyrazinylmethyl)amino]benzoic acid	100900-25-2	Intentional addition	chemical products
19630	DL-Fluorocitric acid barium salt	100929-81-5	Intentional addition	chemical products
19631	Molybdenum di-2-ethylhexyl-phosphorodithioate in mineral oil	100932-50-1	1%	chemical products
19632	5-Mercuricytidine carbonate 5'-triphosphate triethylammonium salt	100940-62-3	Contains (regardless of intentional or impurities)	chemical products
19633	N-(4-Bromophenyl)benzene-1,2-diamine	100953-52-4	Contains (regardless of intentional or impurities)	chemical products
19634	2-Methyl-5-nitrobenzeneboronic acid	100960-11-0	1%	chemical products
19635	Slimes and Sludges, copper electrolytic refining, decopperized, arsenic-rich	100995-81-1	Contains (regardless of intentional or impurities)	chemical products
19636	Dodecanoic acid, cadmium salt, basic	101012-89-9	Contains (regardless of intentional or impurities)	chemical products
19637	Octadecanoic acid, cadmium salt, basic	101012-93-5	Contains (regardless of intentional or impurities)	chemical products
19638	Octadecanoic acid, 12-hydroxy-, cadmium salt, basic	101012-94-6	Contains (regardless of intentional or impurities)	chemical products
19639	Octadecanoic acid, 12-hydroxy-, barium salt, basic	101012-95-7	Intentional addition / 1,000ppm	chemical products
19640	Tricopper(1+) hydrogen hexakis(cyano-o)ferrate(4-), compound with ethyl o-[6-(ethylamino)-3-(ethylimino)-2,7-dimethyl-3H-xanthen-9-yl]benzoate (1:1)	101033-43-6	Intentional addition / 1,000ppm	chemical products
19641	Tetrakis[[2,2,2'-nitritoltris(ethanolato)(1)-N,O]zirconium	101033-44-7	Contains (regardless of intentional or impurities)	chemical products
19642	Barium molybdenum oxide (Ba3Mo2O9)	101062-40-2	Intentional addition / 1%	chemical products
19643	2,3,6,7-Tetrahydro-1H,5H-benz[aj]quinoline monohydrochloride	101077-25-2	1%	chemical products
19644	Thianthreneium, 5-[4-(phenylthio)phenyl]-, (OC-6-11)-hexafluoroantimonate(1-)	101200-57-1	Contains (regardless of intentional or impurities)	chemical products
19645	Thianthreneium, 5-phenyl-, (OC-6-11)-hexafluoroantimonate(1-)	101200-58-2	Contains (regardless of intentional or impurities)	chemical products
19646	Sulfonium, phenylbis[4-(phenylthio)phenyl]-, (OC-6-11)-hexafluoroantimonate(1-)	101200-60-6	Contains (regardless of intentional or impurities)	chemical products
19647	Sulfonium, diphenyl[4-[4-(phenylthio)phenyl]thio]phenyl-, (OC-6-11)-hexafluoroantimonate(1-)	101200-61-7	Contains (regardless of intentional or impurities)	chemical products
19648	Sulfonium, diphenyl[4-(phenylthio)phenyl]-, monochloro derivative, (OC-6-11)-hexafluoroantimonate(1-)	101227-27-4	Contains (regardless of intentional or impurities)	chemical products
19649	Boronic acid, B-[4-(acetyl)amino]phenyl-	101251-09-6	1%	chemical products
19650	Thianthreneium, chloro-5-phenyl-, (OC-6-11)-hexafluoroantimonate(1-)	101294-99-9	Contains (regardless of intentional or impurities)	chemical products
19651	Absorption oils, bicyclo aromatic and heterocyclic hydrocarbon fraction	101316-45-4	Contains (regardless of intentional or impurities)	chemical products
19652	Distillates (coal tar), pitch	101316-49-8	Contains (regardless of intentional or impurities)	chemical products
19653	Distillates (petroleum), C7-9, C8-rich, hydrodesulfurized dearomatized	101316-56-7	Contains (regardless of intentional or impurities)	chemical products
19654	Distillates (petroleum), hydrodesulfurized full-range middle	101316-57-8	Contains (regardless of intentional or impurities)	chemical products
19655	Distillates (petroleum), hydrodesulfurized middle coker	101316-59-0	Contains (regardless of intentional or impurities)	chemical products
19656	Extract residues (coal), light oil alkaline, acid extract, indene fraction	101316-62-5	Contains (regardless of intentional or impurities)	chemical products
19657	Extract residues (coal tar), benzole fraction alkaline, acid extract	101316-63-6	Contains (regardless of intentional or impurities)	chemical products
19658	Hydrocarbons, C8-8, hydrogenated sorption-dearomatized, toluene raffination	101316-66-9	Contains (regardless of intentional or impurities)	chemical products
19659	Hydrocarbons, C8-rich, hydro-treated light naphtha distillates, solvent-refined	101316-67-0	Contains (regardless of intentional or impurities)	chemical products
19660	Lubricating oils (petroleum), C25, solvent-extracted, desalinated, dewaxed, hydrogenated	101316-69-2	Contains (regardless of intentional or impurities)	chemical products
19661	Lubricating oils (petroleum), C17-32, solvent-extracted, dewaxed, hydrogenated	101316-70-5	Contains (regardless of intentional or impurities)	chemical products
19662	Lubricating oils (petroleum), C20-39, solvent-extracted, dewaxed, hydrogenated	101316-71-6	Contains (regardless of intentional or impurities)	chemical products
19663	Lubricating oils (petroleum), C24-50, solvent-extracted, dewaxed, hydrogenated	101316-72-7	Contains (regardless of intentional or impurities)	chemical products
19664	Naphtha (petroleum), hydrodesulfurized full-range coker	101316-76-1	Contains (regardless of intentional or impurities)	chemical products
19665	Tar, brown-coal	101316-83-0	Contains (regardless of intentional or impurities)	chemical products
19666	Tar, brown-coal, low-temperature	101316-84-1	Contains (regardless of intentional or impurities)	chemical products
19667	Tar, coal, low-temperature, distillation residues	101316-85-2	Contains (regardless of intentional or impurities)	chemical products
19668	Tar acids, brown-coal, crude	101316-86-3	Contains (regardless of intentional or impurities)	chemical products
19669	Tar oils, coal, low-temperature	101316-87-4	Contains (regardless of intentional or impurities)	chemical products
19670	8-Nitro-7-quinolinecarboxaldehyde	101327-87-1	1%	chemical products
19671	Barium oxide (BaO), solid solution with calcium oxide, magnesium oxide, phosphorus oxide (P2O5), strontium oxide and zinc oxide, cerium and manganese-doped	101356-94-9	Contains (regardless of intentional or impurities)	chemical products
19672	Barium oxide (BaO), solid solution with calcium oxide, magnesium oxide, phosphorus oxide (P2O5), strontium oxide and zinc oxide, cerium and terbium-doped	101356-95-0	Contains (regardless of intentional or impurities)	chemical products
19673	Barium oxide (BaO), solid solution with calcium oxide, magnesium oxide, phosphorus oxide (P2O5), strontium oxide and zinc oxide, copper-doped	101356-96-1	Contains (regardless of intentional or impurities)	chemical products
19674	Barium oxide (BaO), solid solution with calcium oxide, magnesium oxide, phosphorus oxide (P2O5), strontium oxide and zinc oxide, europium-doped	101356-97-2	Contains (regardless of intentional or impurities)	chemical products
19675	Barium oxide (BaO), solid solution with calcium oxide, magnesium oxide, phosphorus oxide (P2O5), strontium oxide and zinc oxide, tin-doped	101356-98-3	Contains (regardless of intentional or impurities)	chemical products
19676	Cadmium oxide (CdO), solid solution with calcium oxide and titanium oxide (TiO2), praseodymium-doped	101356-99-4	Contains (regardless of intentional or impurities)	chemical products
19677	Cadmium selenide (CdSe), solid solution with cadmium sulfide, zinc selenide and zinc sulfide, aluminum and copper-doped	101357-00-0	Contains (regardless of intentional or impurities)	chemical products
19678	Cadmium selenide (CdSe), solid solution with cadmium sulfide, zinc selenide and zinc sulfide, copper and manganese-doped	101357-01-1	Contains (regardless of intentional or impurities)	chemical products
19679	Cadmium selenide (CdSe), solid solution with cadmium sulfide, zinc selenide and zinc sulfide, europium-doped	101357-02-2	Contains (regardless of intentional or impurities)	chemical products
19680	Cadmium selenide (CdSe), solid solution with cadmium sulfide, zinc selenide and zinc sulfide, gold and manganese-doped	101357-03-3	Contains (regardless of intentional or impurities)	chemical products
19681	Cadmium selenide (CdSe), solid solution with cadmium sulfide, zinc selenide and zinc sulfide, manganese and silver-doped	101357-04-4	Contains (regardless of intentional or impurities)	chemical products
19682	Calcium oxide (CaO), solid solution with silica, strontium oxide and zinc oxide, cerium and manganese-doped	101357-05-5	Contains (regardless of intentional or impurities)	chemical products
19683	Carbonic acid, manganese(2+) salt (1:1), solid solution with aluminum oxide and cerium oxide (CeO2), chromium-doped	101357-08-8	Contains (regardless of intentional or impurities)	chemical products
19684	Gadolinium oxide (Gd2O3), solid solution with lanthanum oxide (La2O3) and yttrium oxide, europium-doped	101357-09-9	1%	chemical products
19685	Gadolinium oxide (Gd2O3), solid solution with lanthanum oxide (La2O3) and yttrium oxide, terbium-doped	101357-10-2	1%	chemical products
19686	Gadolinium oxide (Gd2O3), solid solution with lanthanum oxide (La2O3), sulfur and yttrium oxide, europium-doped	101357-11-3	1%	chemical products
19687	Gadolinium oxide (Gd2O3), solid solution with lanthanum oxide (La2O3), sulfur and yttrium oxide, terbium-doped	101357-12-4	1%	chemical products
19688	Germanium oxide (GeO2), solid solution with magnesium fluoride and magnesium oxide, manganese-doped	101357-13-5	Contains (regardless of intentional or impurities)	chemical products
19689	Benzenamine, N,N-dimethyl-, oxidized, molybdatetungstatephosphates	101357-19-1	1%	chemical products
19690	Silicic acid, aluminum silver salt, sulfurized	101357-29-3	Intentional addition / 25%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
19691	Chromium boride (Cr3B)	101359-30-2	1,000ppm	chemical products
19692	DL-Alanine, N-(2,6-dimethylphenyl)-N-(methoxyacetyl)-, methyl ester, mixture with (T-4)-bis(dimethyl[carbomodithioato-S,S']zinc, [[1,2-ethanediy]bis[carbomodithioato]](2-)]manganese and [[1,2-ethanediy]bis[carbomodithioato]](2-)]zinc	101362-28-1	Contains (regardless of intentional or impurities)	chemical products
19693	Bis[4-(fluorophenyl)methyl](1,2,4-triazol-4-ylmethyl)silane	101377-47-3	Contains (regardless of intentional or impurities)	chemical products
19694	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfoxo [(4-[[2-(sulfoxo)ethyl]sulfonyl]phenyl]amino)sulfonyl derivatives, potassium sodium salts	101377-53-1	Intentional addition / 1,000ppm	chemical products
19695	Mixture of compounds from (dodecakis(p-tolylthio)phthalocyaninato)copper(II) to (hexadecakis(p-tolylthio)phthalocyaninato)copper(II)	101408-30-4	Contains (regardless of intentional or impurities)	chemical products
19696	Hexane, 1-bromo-2,2-dimethyl-	101419-70-9	1,000ppm	chemical products
19697	Benzamide, N-[[[4-(2-chloro-4-(trifluoromethyl)phenoxy]-2-fluorophenyl)amino]carbonyl]-2,6-difluoro-	101463-69-8	Contains (regardless of intentional or impurities)	chemical products
19698	Phosphoric acid, calcium salt (1:1), solid solution with calcium chloride, calcium fluoride, calcium oxide, phosphorus oxide (P2O5) and strontium oxide, antimony and manganese-doped	101500-43-0	Contains (regardless of intentional or impurities)	chemical products
19699	Cuprate(4-), [2-[[[3-[[4-(2-chloro-5-sulfonylamino)-1,6-dihydro-6-oxo-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa O)-5-sulfonylamino]-kappa N2]phenylmethyl]azo-kappa N1]-4-sulfobenzoato(6-)-kappa O]-, trisodium hydrogen	101519-50-0	Intentional addition / 1,000ppm	chemical products
19700	Biguanide, 1-benzyl-, copper complex, sulfate	101540-04-9	Intentional addition / 1,000ppm	chemical products
19701	Biguanide, 1-methyl-, copper complex, sulfate, trihydrate	101540-06-1	Intentional addition / 1,000ppm	chemical products
19702	Biguanide, 1-phenethyl-, copper complex, sulfate	101540-07-2	Intentional addition / 1,000ppm	chemical products
19703	Chromate(7-), bis[2-[[6-[[4-(3-acetylamino)-4-[[4,8-disulfo-2-naphthalenyl]azo]phenyl]amino]-6-chloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoate(5-)]-, heptasodium	101607-36-7	Contains (regardless of intentional or impurities)	chemical products
19704	Distillates (petroleum), heavy steam-cracked	101631-14-5	Contains (regardless of intentional or impurities)	chemical products
19705	Naphtha (petroleum), heavy straight run, aromatic-containing	101631-20-3	Contains (regardless of intentional or impurities)	chemical products
19706	Cuprate(4-), [2-[[[2-hydroxy-3-sulfo-5-[[2-(sulfoxo)ethyl]sulfonyl]phenyl]azo]phenylmethyl]azo]-4-sulfobenzoato(6-)]-, tetrasodium	101678-62-0	Intentional addition / 1,000ppm	chemical products
19707	Strychnidin-10-one, compound with 4,4'-(3H-2,1-benzoxathiol-3-ylidene)bis[2,6-dibromo-3-methylpheno]S,S-dioxide (1:1)	101686-74-2	Contains (regardless of intentional or impurities)	chemical products
19708	Cuprate(4-), [2-[[[2-hydroxy-3-sulfo-5-[[2-(sulfoxo)ethyl]sulfonyl]phenyl]azo]phenylmethyl]azo]-5-sulfobenzoato(6-)]-, tetrasodium	101702-28-7	Intentional addition / 1,000ppm	chemical products
19709	Aromatic hydrocarbons, C20-28, polycyclic, mixed coal-tar pitch-polyethylene-polypropylene pyrolysis-derived	101794-74-5	Contains (regardless of intentional or impurities)	chemical products
19710	Aromatic hydrocarbons, C20-28, polycyclic, mixed coal-tar pitch-polyethylene pyrolysis-derived	101794-75-6	Contains (regardless of intentional or impurities)	chemical products
19711	Aromatic hydrocarbons, C20-28, polycyclic, mixed coal-tar pitch-polystyrene pyrolysis-derived	101794-76-7	Contains (regardless of intentional or impurities)	chemical products
19712	Flue dust, antimony-molybdenum-containing, acrylonitrile manufacture waste catalysis incineration	101794-79-0	Contains (regardless of intentional or impurities)	chemical products
19713	Distillates (coal tar), light oils, neutral fraction	101794-90-5	Contains (regardless of intentional or impurities)	chemical products
19714	Distillates (coal tar), naphthalene oils, indole-methylnaphthalene fraction	101794-91-6	Contains (regardless of intentional or impurities)	chemical products
19715	Hydrocarbons, C8-12, catalytic cracker distillates	101794-97-2	Contains (regardless of intentional or impurities)	chemical products
19716	Naphtha (petroleum), sweetened light	101795-01-1	Contains (regardless of intentional or impurities)	chemical products
19717	(2S,4R)-4-Hydroxy-2-methoxycarbonyl-1-(4-nitrobenzoxycarbonyl)pyrrolidine	101803-29-6	Contains (regardless of intentional or impurities)	chemical products
19718	Ammonium [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](1-)[[2-hydroxy-5-nitrophenyl]azo]-2-naphtholato(2-)]chromate(1-)	101836-91-3	Contains (regardless of intentional or impurities)	chemical products
19719	Dithiocarbamate, molybdenum	101849-51-8	1%	chemical products
19720	1-(4-Bromo-3-nitrophenyl)propan-1-ol	101860-83-7	Contains (regardless of intentional or impurities)	chemical products
19721	7-Amino-3,6,10-triethyl-2-(ethylimino)-2,10-dihydrophoxazin-5-im perchlorate	101866-25-7	1,000ppm	chemical products
19722	Distillates (coal tar), benzole fraction, BTX-rich	101866-26-8	Contains (regardless of intentional or impurities)	chemical products
19723	Distillates (coal tar), naphthalene oils, methylnaphthalene fraction	101866-27-9	Contains (regardless of intentional or impurities)	chemical products
19724	Hydrocarbons, C8-12, catalytic cracking, chemically neutralized, sweetened	101866-28-0	Contains (regardless of intentional or impurities)	chemical products
19725	N-[4-(2-Formylhydrazino)phenyl]carbamate acid phenyl ester	101907-41-9	Contains (regardless of intentional or impurities)	chemical products
19726	Strychnidin-10-one, compound with 4,4'-(3H-2,1-benzoxathiol-3-ylidene)bis[2,6-dibromo-3-methylpheno]S,S-dioxide (2:1)	101912-89-4	Contains (regardless of intentional or impurities)	chemical products
19727	Strychnidin-10-one, compound with 4,4'-(3H-2,1-benzoxathiol-3-ylidene)bis[2,6-dibromo-3-methylpheno]S,S-dioxide (3:1)	101912-97-4	Contains (regardless of intentional or impurities)	chemical products
19728	Nitrous acid, reaction products with 4-(dimethylamino)-alpha-[4-(dimethylamino)phenyl]benzenemethanol and N-ethyl-1-naphthalenamine, oxidized, molybdatetungstetaphosphate	101940-06-1	1%	chemical products
19729	Nitrous acid, reaction products with 4-(dimethylamino)-alpha-[4-(dimethylamino)phenyl]benzenemethanol and N-ethyl-1-naphthalenamine, oxidized, molybdatetungstetaphosphate	101940-07-2	1%	chemical products
19730	Adenosine-5'-tetra phosphate barium salt	102029-51-6	Intentional addition	chemical products
19731	Phosphoric acid, calcium salt (1:1), solid solution with calcium chloride, calcium fluoride, calcium oxide, phosphorus oxide (P2O5) and strontium oxide, cerium manganese and terbium-doped	102047-23-4	Contains (regardless of intentional or impurities)	chemical products
19732	Phosphoric acid, calcium salt (1:1), solid solution with calcium chloride, calcium fluoride, calcium oxide, phosphorus oxide (P2O5) and strontium oxide, europium and manganese-doped	102047-24-5	Contains (regardless of intentional or impurities)	chemical products
19733	Phosphoric acid, calcium salt (1:1), solid solution with calcium chloride, calcium fluoride, calcium oxide, phosphorus oxide (P2O5) and strontium oxide, manganese and tin-doped	102047-26-7	Contains (regardless of intentional or impurities)	chemical products
19734	Xanthylum, 3,6-bis(diethylamino)-9-[2-(methoxycarbonyl)phenyl]-, molybdatesilicate	102082-92-8	1%	chemical products
19735	Indium, ethyldimethyl-	102091-56-5	1%	chemical products
19736	Hydrocarbons, C3-6, C5-rich, steam-cracked naphtha	102110-14-5	Contains (regardless of intentional or impurities)	chemical products
19737	Hydrocarbons, C5-rich, dicyclopentadiene-containing	102110-15-6	Contains (regardless of intentional or impurities)	chemical products
19738	Aluminum gadolinium oxide, solid solution with aluminum yttrium oxide, gallium gadolinium oxide and gallium yttrium oxide, cerium and praseodymium and terbium-doped	102110-16-7	1%	chemical products
19739	Aluminum oxide (Al2O3), solid solution with barium oxide and magnesium oxide, europium-doped	102110-17-8	Intentional addition	chemical products
19740	Aluminum oxide (Al2O3), solid solution with barium oxide, calcium oxide, cerium oxide and strontium oxide, dysprosium and terbium-doped	102110-18-9	Intentional addition	chemical products
19741	Arsenic acid (H3AsO4), magnesium salt, manganese-doped	102110-21-4	Contains (regardless of intentional or impurities)	chemical products
19742	Barium oxide (BaO), solid solution with calcium oxide, strontium oxide and tungsten oxide (WO3), cerium and terbium-doped	102110-22-5	Intentional addition	chemical products
19743	Barium oxide (BaO), solid solution with calcium oxide, strontium oxide and tungsten oxide (WO3), europium-doped	102110-23-6	Intentional addition	chemical products
19744	Barium oxide (BaO), solid solution with calcium oxide, strontium oxide and tungsten oxide (WO3), samarium-doped	102110-25-8	Intentional addition	chemical products
19745	Boric acid (H3BO3), solid solution with cerium oxide (CeO2), lanthanum oxide (La2O3) and strontium oxide, manganese-doped	102110-27-0	Contains (regardless of intentional or impurities)	chemical products
19746	Cadmium oxide (CdO), solid solution with magnesium oxide, tungsten oxide (WO3) and zinc oxide	102110-30-5	Contains (regardless of intentional or impurities)	chemical products
19747	Calcium fluoride (CaF2), manganese-doped	102110-31-6	Contains (regardless of intentional or impurities)	chemical products
19748	Magnesium zinc fluoride, manganese-doped	102110-32-7	Contains (regardless of intentional or impurities)	chemical products
19749	Phosphoric acid, zinc salt (2:3), manganese-doped	102110-33-8	Contains (regardless of intentional or impurities)	chemical products
19750	Silicic acid, yttrium(3+) salt, cerium-doped	102110-37-2	1%	chemical products
19751	Silicic acid, zinc salt, titanium-doped	102110-38-3	Intentional addition / 25%	chemical products
19752	Antimony ores, concentrates, leached	102110-39-4	Contains (regardless of intentional or impurities)	chemical products
19753	Antimony ores, concentrates, roasted	102110-40-7	Contains (regardless of intentional or impurities)	chemical products
19754	Copper ores, concentrates, leached	102110-42-9	Intentional addition / 1,000ppm	chemical products
19755	Fumes, antimony ore concentration	102110-44-1	Contains (regardless of intentional or impurities)	chemical products
19756	Residues, precious metal refining cementation	102110-50-9	Intentional addition / 1%	chemical products
19757	Residues (petroleum), steam-cracked light, aromatic	102110-55-4	Contains (regardless of intentional or impurities)	chemical products
19758	Silver ores, concentrates, leached	102110-56-5	Contains (regardless of intentional or impurities)	chemical products
19759	Silver ores, concentrates, roasted	102110-57-6	Contains (regardless of intentional or impurities)	chemical products
19760	Tin ores, concentrates, leached	102110-65-6	Contains (regardless of intentional or impurities)	chemical products
19761	Tin ores, concentrates, roasted	102110-66-7	Contains (regardless of intentional or impurities)	chemical products
19762	Waste solids, foundry sand, lost wax process iron and steel casting	102110-69-0	Contains (regardless of intentional or impurities)	chemical products
19763	Bismuth oxide (Bi2O3), solid solution with chromium oxide (Cr2O3)	102110-72-5	1,000ppm	chemical products
19764	Silicic acid, zirconium salt, cadmium pigment-encapsulated	102184-95-2	Contains (regardless of intentional or impurities)	chemical products
19765	Slimes and Sludges, cobalt manufacture wastewater treatment	102242-60-4	Intentional addition / 1%	chemical products
19766	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[2-[[4-(3-carboxypyridinio)-6-methoxy-1,3,5-triazin-2-yl]amino]ethyl]amino)sulfonyl sulfoxo derivatives, inner salts, sodium salts	102242-87-5	Intentional addition / 1,000ppm	chemical products
19767	Antimony chromium titanium oxide	102262-17-9	Contains (regardless of intentional or impurities)	chemical products
19768	Chromium cobalt iron oxide	102262-19-1	1,000ppm	chemical products
19769	Chromium cobalt manganese oxide	102262-20-4	Contains (regardless of intentional or impurities)	chemical products
19770	Chromium cobalt copper iron manganese oxide	102262-21-5	Contains (regardless of intentional or impurities)	chemical products
19771	Chromium cobalt iron manganese oxide	102262-22-6	Contains (regardless of intentional or impurities)	chemical products
19772	Chromium copper manganese oxide	102262-23-7	Contains (regardless of intentional or impurities)	chemical products
19773	Xanthylum, 3,6-bis(diethylamino)-9-[2-(methoxycarbonyl)phenyl]-, cyano cuprate ferrate complexes	102262-31-7	Contains (regardless of intentional or impurities)	chemical products
19774	Xanthylum, 3,6-bis(ethylamino)-9-[2-(methoxycarbonyl)phenyl]-, 2,7-dimethyl-, cyano cuprate ferrate complexes	102262-32-8	Contains (regardless of intentional or impurities)	chemical products
19775	Xanthylum, 9-[2-(ethoxycarbonyl)phenyl]-3,6-bis(ethylamino)-2,7-dimethyl-, cyano cuprate ferrate complexes	102262-33-9	Intentional addition / 1,000ppm	chemical products
19776	Chromate(3-), bis[2-hydroxy-3-[[2-hydroxy-7-[(methoxycarbonyl)amino]-1-naphthalenyl]azo]-5-nitrobenzenesulfonato(3-)]-, sodium	102322-77-0	Contains (regardless of intentional or impurities)	chemical products
19777	Cuprate(3-), [2-[[[3-[[4-(6-dichloro-1,3,5-triazin-2-yl)amino]-2-(hydroxy-kappa O)-5-sulfofophenyl]azo-kappa N2]phenylmethyl]azo-kappa N1]-4-sulfobenzoato(5-)-kappa O]-, trihydrogen, (SP-4-3)-	102340-17-0	Intentional addition / 1,000ppm	chemical products
19778	Pentane, 3-(bromomethylene)-	102363-39-3	1,000ppm	chemical products
19779	2-tert-Butyl-5-chloro-6-nitrobenzoxazole	102405-54-9	Contains (regardless of intentional or impurities)	chemical products
19780	2-tert-Butyl-6-nitro-5-[p-(1,1,3,3-tetramethylbutyl)phenoxy]benzoxazole	102405-96-9	Contains (regardless of intentional or impurities)	chemical products
19781	Fumes, tin ore concentration	102423-87-0	Contains (regardless of intentional or impurities)	chemical products
19782	Cuprate(4-), [mu-[[[3,3'-methylene]bis[[6-[[[2-(4-disulfofophenyl)azo]-2,4-dihydroxyphenyl]azo]benzoato]](6-)]]]di-, tetrasodium	102424-25-9	Intentional addition / 1,000ppm	chemical products
19783	Vanadium dichloro(2-hydroxypropanoato-O1,O2)-, (T-4)-	102482-04-2	Intentional addition / 1%	chemical products
19784	(3R,4S)-4,5-Epoxy-penta-1-en-3-ol	102490-00-6	Contains (regardless of intentional or impurities)	chemical products
19785	Hydrogen bis[4-[[4-(ethylsulphonyl)-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-), compound with hexane-1,6-diamine (1:2)	102496-08-2	Contains (regardless of intentional or impurities)	chemical products
19786	Disodium hydrogen bis[3-hydroxy-4-[(2-hydroxyphenyl)azo]-7-nitronaphthalene-1-sulphonato(3-)]chromate(3-)	102506-12-7	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
19787	Chromate(1-), bis[1-[[5-(2,2-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-2-naphthalenolato(2-)]-, hydrogen	102561-72-8	Contains (regardless of intentional or impurities)	chemical products
19788	Chromate(1-), [3-[4-[[5-(2,2-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamido(2-)] [3-[4,5-dihydro-4-[[2-hydroxy-5-methyl-3-nitrophenyl]azo]-3-methyl-5-oxo-1H-pyrazol-1-yl]benzenesulfonamido(2-)]-, hydrogen	102561-73-9	Contains (regardless of intentional or impurities)	chemical products
19789	Cuprate(3-), [29H,31H-phthalocyaninetrissulfonato(5-)-N29,N30,N31,N32]-, trihydrogen, compound with (Z)-9-octadecen-1-amine (1:1)	102561-74-0	Intentional addition / 1,000ppm	chemical products
19790	D,-m-octyltin borate	102687-32-3	Intentional addition / 1,000ppm	chemical products
19791	Carbonate cyclohexyl 1-iodoethyl	102672-57-1	Contains (regardless of intentional or impurities)	chemical products
19792	4,5-Dimethoxy-2-nitrobenzotrile	102714-71-6	Intentional addition	chemical products
19793	2-chloro-1,3-difluoropropane	102738-79-4	Intentional addition / 1,000ppm	chemical products
19794	Amines, tallow alkyl, ethoxylated, compounds with hydrogen bis[1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]chromate(1-)	102782-47-8	Contains (regardless of intentional or impurities)	chemical products
19795	Amines, tallow alkyl, ethoxylated, compounds with hydrogen [1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)] [1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]chromate	102782-48-9	Contains (regardless of intentional or impurities)	chemical products
19796	Amines, tallow alkyl, ethoxylated, compounds with hydrogen bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)(1:1)	102782-49-0	Contains (regardless of intentional or impurities)	chemical products
19797	Amines, tallow alkyl, ethoxylated, compounds with hydrogen bis[2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)(1:1)	102782-50-3	Contains (regardless of intentional or impurities)	chemical products
19798	tau-Fluvalinate	102851-06-9	Contains (regardless of intentional or impurities)	chemical products
19799	Platinate(2-), tetrachloro-, (SP-4-1)-, dipotassium, polymer with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine	102857-74-9	Contains (regardless of intentional or impurities)	chemical products
19800	6-Chloronaphthalene-2-sulfonic acid	102878-14-8	1%	chemical products
19801	Decane, 1,5,6,10-tetrachloro-	102880-00-2	1,000ppm	chemical products
19802	Zirconium, tris[2-(2-butoxyethoxy)ethanolato]propoxy-	102958-43-0	Contains (regardless of intentional or impurities)	chemical products
19803	Fatty acids, C9-11-branched, reaction products with lauric acid and 1-propanol zirconium(4+) salt	102979-93-1	Contains (regardless of intentional or impurities)	chemical products
19804	Propionic acid, 2-mercapto-, dimethylthiocarbamate, compound with strychnine	103070-73-1	Contains (regardless of intentional or impurities)	chemical products
19805	Fenchlorazole-ethyl	103112-35-2	Contains (regardless of intentional or impurities)	chemical products
19806	Carbamic acid, [(2-methylpropoxy)thiomethyl]-, ethyl ester	103122-66-3	Contains (regardless of intentional or impurities)	chemical products
19807	1-Heptene, 2-(bromomethyl)-	103142-95-6	1,000ppm	chemical products
19808	1-Hexene, 2-(bromomethyl)-5-methyl-	103142-96-7	1,000ppm	chemical products
19809	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [(2-carboxybenzoyl)amino]methyl derivatives, barium salts	103170-25-8	Intentional addition / 1,000ppm	chemical products
19810	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [1-(2-hydroxyethyl)-5-methyl-1H-imidazol-4-yl]methyl derivatives, acetates (salts)	103192-59-2	Intentional addition / 1,000ppm	chemical products
19811	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [1,3-bis(2-hydroxyethyl)-5-methyl-1H-imidazolium-4-yl]methyl derivatives, acetates (salts)	103192-60-5	Intentional addition / 1,000ppm	chemical products
19812	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfo [[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]sulfonyl derivatives, potassium salts	103192-62-7	Intentional addition / 1,000ppm	chemical products
19813	Oils, sperm, saponified, barium salts	103213-24-7	Intentional addition / 1,000ppm	chemical products
19814	alpha-D-Galactose-1-phosphate barium salt	103213-39-4	Intentional addition	chemical products
19815	Cobaltate(1-), [1-[[5-(ethylsulfonyl)-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]methyl[[5-(ethylsulfonyl)-2-hydroxyphenyl]azo]-7-hydroxy-2-naphthalenyl]methylcarbamato(2-)]-, sodium	103241-62-9	Intentional addition / 1,000ppm	chemical products
19816	Chromate(1-), aqua[5-chloro-2-hydroxy-3-[[2-hydroxy-1-naphthalenyl]azo]benzenesulfonato(3-)](8-quinolinolato-N1,O8)-, sodium	103241-63-0	Contains (regardless of intentional or impurities)	chemical products
19817	Manganese boride (Mn3B)	103287-47-4	Contains (regardless of intentional or impurities)	chemical products
19818	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-(dimethylamino)propyl]amino]sulfonyl sulfo derivatives, sodium salts, acetates	103332-04-3	Intentional addition / 1,000ppm	chemical products
19819	2-Hexene, 1-bromo-5-methyl-, (E)-	103335-72-4	1,000ppm	chemical products
19820	2-Hexene, 1-bromo-5-methyl-, (Z)-	103335-87-1	1,000ppm	chemical products
19821	Flumioxazin	103361-09-7	Contains (regardless of intentional or impurities)	chemical products
19822	Zirconium, tris[2-[[2-(aminoethyl)amino]ethanolato-O]]2,2-bis[[2-propenyloxy]methyl]-1-butanolato-O,O,O'-, (OC-6-22)-	103373-95-1	Contains (regardless of intentional or impurities)	chemical products
19823	Butanoic acid, 2-hydroxy-, barium salt (2:1)	103404-58-6	Intentional addition	chemical products
19824	alpha-Lactose 1-phosphate barium salt	103404-65-5	Intentional addition	chemical products
19825	Xanthylum, 3,6-bis(diethylamino)-9-[2-(methoxycarbonyl)phenyl]-, molybdatetungstapentaphosphate	103443-41-0	1%	chemical products
19826	Copper(2+), triaminetriaqua, bis[[T-4]-difluorodihydroxyborate(1-)]	103443-42-1	Intentional addition / 1,000ppm	chemical products
19827	Copper(2+), triaminetriaqua, bis[[T-4]-difluorodihydroxyborate(1-)]	103443-43-2	Intentional addition / 1,000ppm	chemical products
19828	Dibenzo(b,e)(1,4)dioxin, pentabromo-	103456-36-6	Intentional addition / 100ppm	chemical products
19829	1,2-Dibromooxanthrene	103456-37-7	Intentional addition / 100ppm	chemical products
19830	1,2,3-Tribromooxanthrene	103456-38-8	Intentional addition / 100ppm	chemical products
19831	TeBDD	103456-39-9	Intentional addition / 100ppm	chemical products
19832	Dibenzo(b,e)(1,4)dioxin, hexabromo-	103456-42-4	Intentional addition / 100ppm	chemical products
19833	Heptabromodibenzo-p-dioxin	103456-43-5	Intentional addition / 100ppm	chemical products
19834	3H-Indolium, 2-[2-[[4-(methoxyphenyl)amino]ethenyl]-1,3,3-trimethyl-, molybdatetungstapentaphosphate	103458-26-0	1%	chemical products
19835	Xanthylum, 9-(2-carboxyphenyl)-3,6-bis(diethylamino)-, hydrogen bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-2-hydroxy-5-nitrobenzenesulfonato(3-)]chromate(3-)(1:2), compound with 3-[[2-ethylhexyloxy]-1-propanamine (1:2)	103458-48-6	Contains (regardless of intentional or impurities)	chemical products
19836	Copper(1+), tetramine fluoroaqua-	103458-49-7	Intentional addition / 1,000ppm	chemical products
19837	Copper, tetraaminedifluoro-	103458-50-0	Intentional addition / 1,000ppm	chemical products
19838	Copper(1+), tetraamineaquafluoro-, (T-4)-fluorotrihydroxyborate(1-)	103458-51-1	Intentional addition / 1,000ppm	chemical products
19839	Copper(2+), aminopentaqua-, (OC-6-21)-, bis[[T-4]-difluorodihydroxyborate(1-)]	103458-52-2	Intentional addition / 1,000ppm	chemical products
19840	Copper(2+), aminopentaqua-, (OC-6-21)-, bis[[T-4]-fluorotrihydroxyborate(1-)]	103458-53-3	Intentional addition / 1,000ppm	chemical products
19841	Zirconium, bis[2,2-bis(2-propenyloxy)methyl]-1-butanolato-O1]bis[2,2-bis(2-propenyloxy)methyl]-1-butanolato-O1,O2]-	103475-11-2	Contains (regardless of intentional or impurities)	chemical products
19842	Copper(1+), tetraamineaquafluoro-, (T-4)-difluorodihydroxyborate(1-)	103479-10-3	Intentional addition / 1,000ppm	chemical products
19843	1-Phenanthrenemethanamine, 1,2,3,4,4a,9,10,10a-octahydro-1,4a-dimethyl-7-(1-methylethyl)-, [1R-(1,4.alpha,4a.beta,10.alpha.)]-, compound with molybdenum sodium hydroxide oxide silicate	103513-39-9	1%	chemical products
19844	Copper(2+), diamminetriaqua-, (OC-6-22)-, bis[[T-4]-difluorodihydroxyborate(1-)]	103530-80-9	Intentional addition / 1,000ppm	chemical products
19845	Cuprate(2-), dihydrogen, compound with (Z)-9-octadecen-1-amine (1:3)	103534-14-1	Intentional addition / 1,000ppm	chemical products
19846	Copper(2+), diamminetriaqua-, (OC-6-22)-, bis[[T-4]-fluorotrihydroxyborate(1-)]	103570-41-8	Intentional addition / 1,000ppm	chemical products
19847	Ferrate(4-), hexakis(cyano-C)-, 3,6-bis(diethylamino)-9-[2-(methoxycarbonyl)phenyl]xanthylum copper(1+)	103650-96-0	Intentional addition / 1,000ppm	chemical products
19848	Ferrate(4-), hexakis(cyano-C)-, 3,6-bis(ethylamino)-9-[2-(methoxycarbonyl)phenyl]-2,7-dimethylxanthylum copper(1+)	103650-97-1	Intentional addition / 1,000ppm	chemical products
19849	Ferrate(4-), hexakis(cyano-C)-, copper(2+) 9-[[ethoxycarbonyl]phenyl]-3,6-bis(ethylamino)-2,7-dimethylxanthylum	103650-98-2	Intentional addition / 1,000ppm	chemical products
19850	Poly(oxy-1,2-ethanediy), alpha-[2-[3,6-bis(diethylamino)xanthylum-9-yl]benzoyl]-omega-hydroxy-, bis[2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	103651-07-6	Contains (regardless of intentional or impurities)	chemical products
19851	Poly(oxy-1,2-ethanediy), alpha-[2-[3,6-bis(diethylamino)xanthylum-9-yl]benzoyl]-omega-hydroxy-, bis[2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl]-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)	103651-08-7	Contains (regardless of intentional or impurities)	chemical products
19852	Poly(oxy-1,2-ethanediy), alpha-[2-[3,6-bis(diethylamino)xanthylum-9-yl]benzoyl]-omega-hydroxy-, [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)] [2-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl]-1H-pyrazol-4-yl]azo]benzoato(2-)]chromate(1-)	103671-34-7	Contains (regardless of intentional or impurities)	chemical products
19853	1,2-Diaminopropane-N,N,N'-tetraacetic acid ferric ammonium salt	103690-85-3	1%	chemical products
19854	1H-1,2,4-Triazolium, 5-[[4-(dimethylamino)phenyl]azo]-1,4-dimethyl-, perchlorate	103749-25-3	1,000ppm	chemical products
19855	5-[[4-(Dimethylamino)phenyl]azo]-1,4-dimethyl-1H-1,2,4-triazolium tetrafluoroborate(1-)	103749-26-4	1%	chemical products
19856	Bromthymol blue compound with strychnine (1:1)	103792-92-3	Contains (regardless of intentional or impurities)	chemical products
19857	Ferrate(4-), hexakis(cyano-C)-, 4,4'-carbonimidylbis[N,N-dimethylbenzenamine], copper(1+) salts	103818-83-3	Intentional addition / 1,000ppm	chemical products
19858	Benzenesulfonic acid, C10-14-alkyl derivatives	103818-94-6	1%	chemical products
19859	Amines, C10-14-branched and linear alkyl, compounds with sodium hydrogen [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)] [1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)]chromate(2-)(1:1)	103819-10-9	Contains (regardless of intentional or impurities)	chemical products
19860	Acrinathrin	103833-18-7	Intentional addition	chemical products
19861	Isooctanoic acid, manganese salt	103937-77-5	Contains (regardless of intentional or impurities)	chemical products
19862	Octanoic acid, manganese(4+) salt	103972-75-4	Contains (regardless of intentional or impurities)	chemical products
19863	(4-Methylnaphthalen-1-yl)boronic acid	103986-53-4	1%	chemical products
19864	(2-Methylnaphthalen-1-yl)boronic acid	103989-84-0	1%	chemical products
19865	Manganese, soya protein hydrolyzates complexes	104037-78-7	Contains (regardless of intentional or impurities)	chemical products
19866	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, compound with molybdenum hydroxide oxide phosphate (1:1)	104062-50-2	Contains (regardless of intentional or impurities)	chemical products
19867	Trisodium (6-anilino-2-(5-nitro-2-oxidophenylazo)-3-sulfonato-1-naphtholato(4-sulfonato-1,1'-azido-2,2'-naphtholato)chromate(1-)	104105-46-6	Contains (regardless of intentional or impurities)	chemical products
19868	2-Methoxy-1-naphthaleneboronic acid	104116-17-8	1%	chemical products
19869	Stannane, (acetyloxy)tributoxy-	104133-03-1	Contains (regardless of intentional or impurities)	chemical products
19870	3,5-Dichloro-4-(1,1,2,2-tetrafluoroethoxy)aniline	104147-32-2	Contains (regardless of intentional or impurities)	chemical products
19871	Manganese, [1,2-ethanediy]bis[carbamodithioato][2-]-, mixture with citcop 4E and [1,2-ethanediy]bis[carbamodithioato][2-]zinc	104193-72-8	Contains (regardless of intentional or impurities)	chemical products
19872	Ferrate(1-), [5-[[2,4-dihydroxy-5-[[2-hydroxy-3,5-dinitrophenyl]azo]phenyl]azo]-2-naphthalenesulfonato(3-)]-, sodium	104199-50-0	1%	chemical products
19873	Ferrate(2-), [4-[[2,4-dihydroxy-5-[[2-methyl-5-[[methylsulfonyl]amino]-4-[[4-(phenylamino)-3-sulfonylphenyl]azo]phenyl]azo]-3-(phenylazo)phenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]-, sodium hydrogen	104199-51-1	1%	chemical products
19874	1-Octene, 3-bromo-, (±)-	104220-91-9	1,000ppm	chemical products
19875	Tellurium, tetrakis[bis(2-methylpropyl)carbamodithioato-kappa S,kappa S']-	104276-82-6	Contains (regardless of intentional or impurities)	chemical products
19876	3-Carboxypyridinium dichromate	104316-82-7	Intentional addition / 1,000ppm	chemical products
19877	Hexaamminenickel(II) chloride	104316-83-8	Contains (regardless of intentional or impurities)	chemical products
19878	Molybdenum hydroxide oxide phosphate (Mo(OH)O(PO4))	104349-52-2	1%	chemical products
19879	Stannane, (thioxomethoxy)-	104359-06-0	1,000ppm	chemical products
19880	Acetamide, N-[2-[[4-chloro-3-cyano-5-formyl-2-thienyl]azo]-5-(diethylamino)phenyl]-	104366-25-8	Contains (regardless of intentional or impurities)	chemical products
19881	Boric acid, B-1-penten-1-yl-	104376-24-1	1%	chemical products
19882	Benzoic acid, 4-(bromomethyl)-3-methyl-, methyl ester	104447-92-9	1%	chemical products
19883	Chromium, Saccharomyces cerevisiae protein hydrolyzates complexes	104466-01-5	1,000ppm	chemical products
19884	Chromium, soya protein hydrolyzates complexes	104466-02-6	1,000ppm	chemical products





#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
20001	Molybdenum potassium oxide (MoK0.41O3)	107114-56-7	1%	chemical products
20002	Lithium molybdenum oxide (Li0.76MoO3)	107114-57-8	1%	chemical products
20003	Molybdenum sodium oxide (MoNa0.55O3)	107114-63-6	1%	chemical products
20004	Gallium arsenide phosphide (GaAs0.72P0.28)	107251-67-2	1,000ppm	chemical products
20005	Gallium arsenide phosphide (GaAs0.75P0.25)	107251-68-3	1,000ppm	chemical products
20006	1-Fluoropyridinium tetrafluoroborate	107264-09-5	Contains (regardless of intentional or impurities)	chemical products
20007	Gallium arsenide phosphide (GaAs0.55-0.65P0.35-0.45)	107284-23-1	1,000ppm	chemical products
20008	1-Hexadecanaminium, N,N,N-trimethyl-, hexa-mu.-oxotetra-mu.-3-oxodi-mu.5-oxotetradecaooctamolybdate(4-)(4:1)	107311-25-1	Contains (regardless of intentional or impurities)	chemical products
20009	Benzeneethanaminium, N,N-dimethyl-N-octadecyl, hexa-mu.-oxotetra-mu.-3-oxodi-mu.5-oxotetradecaooctamolybdate(4-)(4:1)	107333-79-9	Contains (regardless of intentional or impurities)	chemical products
20010	1-Naphthaleneacetic acid, 1.alpha.,2,3,4.alpha.,5,6,7,8.alpha.-decahydro-6.beta.-hydroxy-5,5.alpha.beta.-trimethyl-2-oxo-, methyl ester, hydrogen phthalate, compound with strychnine	107354-69-8	Contains (regardless of intentional or impurities)	chemical products
20011	Nickel oxide (NiO1.4)	107372-45-2	Contains (regardless of intentional or impurities)	chemical products
20012	Barium titanium oxide (Ba1.14Ti8O16)	107404-96-6	Intentional addition	chemical products
20013	Manganese, [[1,2-ethanedilybis[carbamodithioato]](2)-], mixture with alpha-butyl-alpha-(4-chlorophenyl)-1H-1,2,4-triazole-1-propanenitrile and [[1,2-ethanedilybis[carbamodithioato]](2)-]zinc	107452-09-5	Contains (regardless of intentional or impurities)	chemical products
20014	Gallium arsenide phosphide (GaAs0.3P0.7)	107477-77-0	1,000ppm	chemical products
20015	Gallium arsenide phosphide (GaAs0.9P0.1)	107498-96-4	1,000ppm	chemical products
20016	Titanium boride (Ti0.77B0.23)	107500-09-4	1%	chemical products
20017	Titanium boride (Ti0.45B0.55)	107500-10-7	1%	chemical products
20018	Zirconium_bis[[1,2,3,4,5-h]-1-butyl-2,4-cyclopentadien-1-yl]dimethyl-	107534-15-6	Contains (regardless of intentional or impurities)	chemical products
20019	Tebuconazole	107534-96-3	Contains (regardless of intentional or impurities)	chemical products
20020	Barium copper yttrium oxide	107539-20-8	Intentional addition / 1%	chemical products
20021	1,2,3,7,8-Pentabromodibenzofuran	107555-93-1	Intentional addition / 100ppm	chemical products
20022	Cyclopropanecarboxylic acid, 3-(2-cyanopropenyl)-2,2-dimethyl-, compound with strychnine (1:1)	107559-52-4	Contains (regardless of intentional or impurities)	chemical products
20023	Cobalt oxide (Co3O2)	107592-59-6	Intentional addition / 1%	chemical products
20024	Nickel alloy, base, Ni 75P 25	107593-02-2	Contains (regardless of intentional or impurities)	chemical products
20025	Cobalt oxide (Co2O)	107598-50-5	Intentional addition / 1%	chemical products
20026	Acetic acid, thiois[[p-bromophenyl]-], compound with strychnine	107601-04-7	Contains (regardless of intentional or impurities)	chemical products
20027	Acetic acid, sulfinylbis[[p-bromophenyl]-], compound with strychnine	107601-05-8	Contains (regardless of intentional or impurities)	chemical products
20028	Acetic acid, thiois[[phenyl]-], compound with strychnine (1:2)	107601-06-9	Contains (regardless of intentional or impurities)	chemical products
20029	Acetic acid, sulfinylbis[[phenyl]-], compound with strychnine	107601-07-0	Contains (regardless of intentional or impurities)	chemical products
20030	Sulfuric acid, cobalt(2+) salt (2:1)	107630-45-5	Intentional addition / 1%	chemical products
20031	Molybdenum sodium oxide (Mo2Na0.55O4)	107637-31-0	1%	chemical products
20032	Molybdenum sodium oxide (Mo2Na0.9O4)	107637-32-1	1%	chemical products
20033	Molybdenum sodium oxide (Mo2Na1.3O4)	107637-33-2	1%	chemical products
20034	Molybdenum sodium oxide (Mo2Na1.4O4)	107637-34-3	1%	chemical products
20035	Molybdenum sodium oxide (Mo2Na1.6O4)	107637-35-4	1%	chemical products
20036	Molybdenum sodium oxide (Mo2Na1.9O4)	107637-36-5	1%	chemical products
20037	Propanamide, 3-hydrazino-N,N-dimethyl-	107746-30-5	Contains (regardless of intentional or impurities)	chemical products
20038	2,4-Dimethyl-1-(phenylmethyl)pyridinium tetrafluoroborate	107758-58-7	Intentional addition / 1%	chemical products
20039	Gallium arsenide phosphide (GaAs0.65P0.35)	107762-95-8	1,000ppm	chemical products
20040	Titanium boride (Ti0.6B0.4)	107763-05-3	1%	chemical products
20041	Titanium boride (Ti0.41B0.59)	107763-06-4	1%	chemical products
20042	Molybdenum potassium oxide (Mo6K0.9O17)	107763-83-7	1%	chemical products
20043	Gallium arsenide phosphide (GaAs0.96P0.04)	107793-14-6	1,000ppm	chemical products
20044	Gallium arsenide phosphide (GaAs0.97P0.03)	107793-15-7	1,000ppm	chemical products
20045	Gallium arsenide phosphide (GaAs0.98P0.02)	107793-16-8	1,000ppm	chemical products
20046	Borate(1-)-11B, tetrafluoro-, potassium	107827-91-8	1%	chemical products
20047	Molybdenum boride (MoB6), (OC-6-11)-	107929-40-8	Contains (regardless of intentional or impurities)	chemical products
20048	3-Pyrazoline-4-sulfonic acid, 2,3-dimethyl-5-oxo-1-phenyl-, compound with strychnine	107989-62-8	Contains (regardless of intentional or impurities)	chemical products
20049	Gallium arsenide phosphide (GaAs0.53P0.47)	107992-66-5	1,000ppm	chemical products
20050	Manganese, [[1,2-ethanedilybis[carbamodithioato]](2)-], mixture with 2-chloro-N-(2,6-dimethylphenyl)-N-(tetrahydro-2-oxo-3-furanyl)acetamide and [[1,2-ethanedilybis[carbamodithioato]](2)-]zinc	108043-20-5	Contains (regardless of intentional or impurities)	chemical products
20051	Stannane, methyltripentyl-	108110-01-6	Contains (regardless of intentional or impurities)	chemical products
20052	Decane, 1,3,3,5-tetrachloro-	108140-19-8	1,000ppm	chemical products
20053	Decane, 1,3,5-trichloro-	108140-20-1	1,000ppm	chemical products
20054	Iodobis(indenyl)vanadium(III)	108150-19-2	Intentional addition / 1%	chemical products
20055	Strychnine, hexachlorosmate(IV)	108171-69-3	Contains (regardless of intentional or impurities)	chemical products
20056	Quazatine	108173-90-6	Contains (regardless of intentional or impurities)	chemical products
20057	2-Naphthalenesulfonic acid, 7-[[[4,6-bis[[2-aminopropyl]amino]-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[[2-methoxyphenyl]azo]-, monoformate (salt)	108225-03-2	Contains (regardless of intentional or impurities)	chemical products
20058	Cuprate(3-), [29H,31H-phthalocyanine-C,C-C-trisulfonat(5-)-N29,N30,N31,N32]-, trihydrogen, compound with (Z)-9-octadecen-1-amine (1:3)	108300-90-9	Intentional addition / 1,000ppm	chemical products
20059	Copper, 4-[[[2,4-dihydroxy-3-[[[2-hydroxy-3,5-dinitrophenyl]azo]phenyl]azobenzene]sulfonate sodium complexes	108347-99-5	Intentional addition / 1,000ppm	chemical products
20060	Strychnine, [[ethylenedinitro]tetraacetato]cuprate(II)	108374-34-1	Contains (regardless of intentional or impurities)	chemical products
20061	D-Glucitol, 6-(dihydrogen phosphate), barium salt (1:1)	108392-12-7	Intentional addition	chemical products
20062	Lithium molybdenum oxide (Li0.13MoO2)	108399-42-4	1%	chemical products
20063	Lithium molybdenum oxide (Li0.18MoO2)	108399-43-5	1%	chemical products
20064	Lithium molybdenum oxide (Li0.23MoO2)	108399-44-6	1%	chemical products
20065	Lithium molybdenum oxide (Li0.25MoO2)	108399-45-7	1%	chemical products
20066	Lithium molybdenum oxide (Li0.27MoO2)	108399-46-8	1%	chemical products
20067	Lithium molybdenum oxide (Li0.34MoO2)	108399-47-9	1%	chemical products
20068	Lithium molybdenum oxide (Li0.43MoO2)	108399-48-0	1%	chemical products
20069	Lithium molybdenum oxide (Li0.45MoO2)	108399-49-1	1%	chemical products
20070	Lithium molybdenum oxide (Li0.46MoO2)	108399-50-4	1%	chemical products
20071	Lithium molybdenum oxide (Li0.47MoO2)	108399-51-5	1%	chemical products
20072	Lithium molybdenum oxide (Li0.48MoO2)	108399-52-6	1%	chemical products
20073	Lithium molybdenum oxide (Li0.49MoO2)	108399-53-7	1%	chemical products
20074	Lithium molybdenum oxide (Li0.5MoO2)	108399-54-8	1%	chemical products
20075	Lithium molybdenum oxide (Li0.59MoO2)	108399-55-9	1%	chemical products
20076	Lithium molybdenum oxide (Li0.72MoO2)	108399-56-0	1%	chemical products
20077	Lithium molybdenum oxide (Li0.74MoO2)	108399-57-1	1%	chemical products
20078	Lithium molybdenum oxide (Li0.76MoO2)	108399-58-2	1%	chemical products
20079	Lithium molybdenum oxide (Li0.98MoO2)	108399-59-3	1%	chemical products
20080	Lithium molybdenum oxide (Li0.99MoO2)	108399-60-6	1%	chemical products
20081	Gallium arsenide phosphide (GaAs0.11P0.89)	108424-60-8	1,000ppm	chemical products
20082	Gallium arsenide phosphide (GaAs0.31P0.69)	108424-61-9	1,000ppm	chemical products
20083	Copper selenide (Cu1.95Se)	108424-99-3	Contains (regardless of intentional or impurities)	chemical products
20084	Copper selenide (Cu1.99Se)	108425-00-9	Contains (regardless of intentional or impurities)	chemical products
20085	Phenol, (3,5-dimethyl)ethyl-	108449-27-0	Intentional addition / 1%	chemical products
20086	Strychnine, hexacyanochromate(III)	108486-13-1	Contains (regardless of intentional or impurities)	chemical products
20087	5,7,12-Trioxa-6-stannaicoso-2,9-dienoic acid, 13-methyl-6,6-diethyl-4,8,11-trioxo-, 1-methoxyethyl ester, (Z,Z)	108537-06-0	Contains (regardless of intentional or impurities)	chemical products
20088	2-Hexene, 1-bromo-2,5-dimethyl-	108571-34-2	1,000ppm	chemical products
20089	Nickel oxide (Ni4O)	108599-78-6	Contains (regardless of intentional or impurities)	chemical products
20090	Nickel oxide (Ni5O)	108599-79-7	Contains (regardless of intentional or impurities)	chemical products
20091	Gallium arsenide phosphide (GaAs0.85-0.9P0.1-0.15)	108600-27-7	1,000ppm	chemical products
20092	Chloropentafluoropropane	108662-83-5	1,000ppm	chemical products
20093	2-(Chloromethyl)benzaldehyde	108683-62-1	Contains (regardless of intentional or impurities)	chemical products
20094	2-Chloro-1-(chloromethyl)-3-nitrobenzene	108772-93-6	1%	chemical products
20095	Nickel(2+), hexakis[1H-imidazole-N3]-, (OC-6-11)-, 1,2-benzenedicarboxylate (1:1)	108818-89-9	Contains (regardless of intentional or impurities)	chemical products
20096	Gallium arsenide phosphide (GaAs0.57P0.43)	108821-70-1	1,000ppm	chemical products
20097	Gallium arsenide phosphide (GaAs0.57-1P0-0.43)	108821-71-2	1,000ppm	chemical products
20098	Gallium arsenide phosphide (GaAs0.66P0.34)	108821-72-3	1,000ppm	chemical products
20099	Gallium arsenide phosphide (GaAs0.67P0.33)	108821-73-4	1,000ppm	chemical products
20100	Gallium arsenide phosphide (GaAs0.77P0.23)	108821-74-5	1,000ppm	chemical products
20101	Gallium arsenide phosphide (GaAs0.83P0.17)	108821-75-6	1,000ppm	chemical products
20102	Benzenesulfonic acid, 2-[[[2-hydroxy-1-naphthalenyl]azo]-5-methyl-, barium salt (2:1)	108825-27-0	Contains (regardless of intentional or impurities)	chemical products
20103	4-Strychnidin-10-one, mono-(+)-1,3-dihydro-beta-1-naphthalenyl-1,3-dioxo-2H-isoindole-2-butanolate	108827-18-5	Contains (regardless of intentional or impurities)	chemical products
20104	4-Dibenzothiophene-4-boronic acid	108847-20-7	1%	chemical products
20105	Boronic acid, B-1-thianthrenyl-	108847-76-3	1%	chemical products
20106	Gallium arsenide phosphide (GaAs0.14P0.86)	108855-43-2	1,000ppm	chemical products
20107	1-(2-Chloroethyl)-4-piperidinecarboxylic acid hydrochloride	108890-51-3	Intentional addition	chemical products
20108	Gallium arsenide phosphide (GaAs0.41P0.59)	108915-42-0	1,000ppm	chemical products
20109	Boron carbide (BC4)	108915-51-1	1%	chemical products
20110	Strychnine, hexathiocyanatochromate(III)	108987-70-8	Contains (regardless of intentional or impurities)	chemical products
20111	Barium calcium strontium chloride phosphate, europium-doped	109037-74-3	Intentional addition / 1,000ppm	chemical products
20112	Benzene, reaction products with chlorine and sulfur chloride (S2Cl2), hexafluoroantimonates(1-)	109037-75-4	Contains (regardless of intentional or impurities)	chemical products
20113	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-(4-methylmorpholinium-4-yl)propyl]amino]sulfonyl derivatives, methyl sulfates	109037-79-8	Intentional addition / 1,000ppm	chemical products
20114	Bis(benzoyloxy)bis(1,1-dimethylethyl)	109054-07-1	Intentional addition / 1,000ppm	chemical products
20115	Chromate(1-), bis[3-hydroxy-4-[[[2-hydroxy-3,5-dinitrophenyl]azo]-N-phenyl-2-naphthalenecarboxamidato(2-)-], sodium	109125-50-0	Contains (regardless of intentional or impurities)	chemical products
20116	Chromate(1-), bis[3-hydroxy-4-[[[2-hydroxy-3,5-dinitrophenyl]azo]-N-phenyl-2-naphthalenecarboxamidato(2-)-], ammonium	109125-51-1	Contains (regardless of intentional or impurities)	chemical products
20117	1-Dodecanaminium, N-ethyl-2-hydroxy-N-(2-hydroxydodecyl)-N-methyl-, bis[[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo] benzoato(2-)]chromate(1-)	109125-62-4	Contains (regardless of intentional or impurities)	chemical products
20118	Cuprate(4-), [2-[[[3-[[4-chloro-6-[[[3-[[4-chloro-1,6-dihydro-6-oxo-1,3,5-triazin-2-yl]amino]-2,4,6-trimethyl-5-sulfonyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulfonyl]azo]phenylmethyl]azo]-4-sulfonylbenzoato(6-)]-, trisodium hydrogen	109184-18-1	Intentional addition / 1,000ppm	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
20232	Bis(1,2-benzenediaminato-N,N')nickel	111532-88-8	Contains (regardless of intentional or impurities)	chemical products
20233	Strychnidin-10-one, compound with hydrogen sulfide (H2S) (2:1)	111536-63-1	Contains (regardless of intentional or impurities)	chemical products
20234	Lithium molybdenum oxide (Li0.33MoO3)	111556-63-9	1%	chemical products
20235	Copper selenide (Cu1.72Se)	111568-26-4	Contains (regardless of intentional or impurities)	chemical products
20236	Ammonium molybdenum oxide ((NH4)0.15MoO3.07)	111568-43-5	1%	chemical products
20237	Ammonium molybdenum oxide ((NH4)0.15MoO3.08)	111568-80-0	1%	chemical products
20238	Ammonium molybdenum oxide ((NH4)0.09MoO3.04)	111568-81-1	1%	chemical products
20239	Tantalum niobium carbide	111614-54-1	Contains (regardless of intentional or impurities)	chemical products
20240	1H,3H-Naphtho[1,8-cd]pyran-1,3-dione, 6-(2-nitrophenoxy)-	111669-59-1	Contains (regardless of intentional or impurities)	chemical products
20241	Ferrate(1-), [[N,N'-1,3-propanediylbis[N-(carboxymethyl)glycinate]](4-)-N,N'.O.O'.ON.ON.]-, ammonium, (OC-6-21)	111687-36-6	Intentional addition / 1%	chemical products
20242	Nickel oxide (NiO1.05)	111706-41-3	Contains (regardless of intentional or impurities)	chemical products
20243	Nickel oxide (NiO1.02)	111706-42-4	Contains (regardless of intentional or impurities)	chemical products
20244	Nickel oxide (NiO1.01)	111706-43-5	Contains (regardless of intentional or impurities)	chemical products
20245	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [1-(2-hydroxyethyl)-3-methyl-1H-imidazolium-4-yl]methyl derivatives, acetates (salts)	111719-81-4	Intentional addition / 1,000ppm	chemical products
20246	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [1-(2-hydroxyethyl)-3-methyl-1H-imidazolium-4-yl]methyl derivatives, salts with methoxyacetic acid	111719-82-5	Intentional addition / 1,000ppm	chemical products
20247	Nickel oxide (NiO1.03)	111721-39-2	Contains (regardless of intentional or impurities)	chemical products
20248	Manganese oxide (MnO0.2-0.5)	111747-17-2	1%	chemical products
20249	Gallium arsenide phosphide (GaAs0.8-0.92P0.08-0.2)	111776-55-7	1,000ppm	chemical products
20250	Manganese oxide (MnO1.89)	111776-56-8	1%	chemical products
20251	Bis[5-[[4-(dimethylamino)phenyl]imino]-8(5h)-quinolone]nickel(II) diperchlorate	111792-92-8	Contains (regardless of intentional or impurities)	chemical products
20252	4-Dihydroxyboryl-D-phenylalanine	111821-49-9	1%	chemical products
20253	Halfenprox	111872-58-3	Intentional addition / 25%	chemical products
20254	Strychnidin-10-one, (+)-7,7-dimethoxy[4,4'-bi-1,3-benzodioxole]-5,5'-dicarboxylate	111897-22-4	Contains (regardless of intentional or impurities)	chemical products
20255	Strychnidin-10-one, (-)-7,7-dimethoxy[4,4'-bi-1,3-benzodioxole]-5,5'-dicarboxylate	111897-24-6	Contains (regardless of intentional or impurities)	chemical products
20256	Barium copper yttrium oxide	111907-01-8	Intentional addition	chemical products
20257	Cuprate(4-), [5-(acetylamino)-4-hydroxy-3-[[5-hydroxy-6-[[2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]-7-sulfo-2-naphthalenyl]azo]-2,7-naphthalenedisulfonato(6-)-], tetrasodium	111977-80-1	Intentional addition / 1,000ppm	chemical products
20258	Cuprate(3-), [3-[[2,4-dihydroxy-3-[[2-hydroxy-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo]phenyl]azo]-1,5-naphthalenedisulfonato(5-)-], trisodium	111977-81-2	Intentional addition / 1,000ppm	chemical products
20259	Cyanamide, [3-[[6-chloro-3-pyridinyl]methyl]-2-thiazolidinylidene]-	111988-49-9	Contains (regardless of intentional or impurities)	chemical products
20260	1H,3H-Pyrrolo[1,2-c][1,3,2]oxazaborole, tetrahydro-1-methyl-3,3-diphenyl-, (3aR)-	112022-83-0	1%	chemical products
20261	Gallium arsenide phosphide (GaAs0.04P0.96)	112050-17-6	1,000ppm	chemical products
20262	Copper selenide (Cu1.77Se)	112073-63-9	Contains (regardless of intentional or impurities)	chemical products
20263	Copper selenide (Cu1.78Se)	112099-83-9	Contains (regardless of intentional or impurities)	chemical products
20264	Copper selenide (Cu1.85Se)	112131-82-5	Contains (regardless of intentional or impurities)	chemical products
20265	Copper selenide (Cu1.92Se)	112131-87-0	Contains (regardless of intentional or impurities)	chemical products
20266	Barium niobium sodium oxide (Ba3.99Nb10Na2O30)	112155-15-4	Intentional addition	chemical products
20267	Titanium boride (Ti0.7B0.3)	112155-41-6	1%	chemical products
20268	Titanium boride (Ti0.66B0.34)	112155-42-7	1%	chemical products
20269	Titanium boride (Ti0.54B0.46)	112155-43-8	1%	chemical products
20270	Titanium boride (Ti0.4B0.6)	112155-44-9	1%	chemical products
20271	Titanium boride (Ti0.23-0.6B0.4-0.77)	112155-45-0	1%	chemical products
20272	Zirconium heptanoate	112180-94-6	Contains (regardless of intentional or impurities)	chemical products
20273	5-Bromo-2-fluorobenzenboronic acid	112204-57-6	1%	chemical products
20274	Zirconium, dichloro[1,2-ethanediy]bis(1,2,3,3a,7a-eta)-[1H-inden-1-ylidene]-	112243-78-4	Contains (regardless of intentional or impurities)	chemical products
20275	Tetraconazole	112281-77-3	Contains (regardless of intentional or impurities)	chemical products
20276	Chromium copper oxide (Cr0-2Cu0-1O1-3)	112285-78-6	Intentional addition / 1,000ppm	chemical products
20277	Arsenic selenide (As0.42Se0.58)	112285-79-7	Contains (regardless of intentional or impurities)	chemical products
20278	Gallium arsenide phosphide (GaAs0.6-0.84P0.16-0.4)	112286-95-7	Contains (regardless of intentional or impurities)	chemical products
20279	Gallium arsenide phosphide (GaAs0.62P0.38)	112286-70-1	1,000ppm	chemical products
20280	Dibutyltin borate	112286-91-6	1,000ppm	chemical products
20281	Barium titanium oxide (Ba0.3TiO2.3)	112309-69-9	Contains (regardless of intentional or impurities)	chemical products
20282	N-tert-Butyl-N'-(4-ethylbenzoyl)-3,5-dimethylbenzohydrazide	112354-28-4	Intentional addition	chemical products
20283	Molybdenum vanadium hydroxide oxide phosphate (Mo7V5(OH)5O29.5(PO4))	112410-23-8	Contains (regardless of intentional or impurities)	chemical products
20284	Molybdenum silicide (MoSi15)	112510-41-5	Intentional addition / 1%	chemical products
20285	Urea, tetrafluoroborate(1-)(1:1)	112548-46-6	1%	chemical products
20286	Nickel boride (Ni1.88B)	112592-62-8	1%	chemical products
20287	Cobalt boride (Co1.96B)	112653-88-0	Contains (regardless of intentional or impurities)	chemical products
20288	Iron boride (Fe2.98B)	112653-89-1	Intentional addition / 1%	chemical products
20289	Gallium arsenide phosphide (GaAs1.67P0.33)	112653-90-4	1%	chemical products
20290	Nickel sulfide (NiS1.2)	112660-19-2	1,000ppm	chemical products
20291	Nickel sulfide (NiS1.2)	112711-07-6	Contains (regardless of intentional or impurities)	chemical products
20292	Bismuth molybdenum vanadium oxide	112764-76-8	Contains (regardless of intentional or impurities)	chemical products
20293	Xanthylum, 3,6-bis(ethylamino)-9-[2-(methoxycarbonyl)phenyl]-2,7-dimethyl-, copper(1+) (OC-6-11)-hexakis(cyano-C)ferrate(4-)(1:3:1)	112764-77-9	Intentional addition / 1,000ppm	chemical products
20294	Amines, C10-14-alkyl, bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]chromate(3-)(3:1)	112764-80-4	Contains (regardless of intentional or impurities)	chemical products
20295	Amines, C10-14-alkyl, [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-[1-(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(2-)(2:1)	112764-81-5	Contains (regardless of intentional or impurities)	chemical products
20296	Amines, C10-14-alkyl, [3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-[1-(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(2-)(2:1)	112764-82-6	Contains (regardless of intentional or impurities)	chemical products
20297	Iron alloy, base, Fe 97, Mo 3.2	112788-56-4	Contains (regardless of intentional or impurities)	chemical products
20298	Propanamide, 3-(ethylidenedihydrazino)-N,N-dimethyl-	112858-31-8	Contains (regardless of intentional or impurities)	chemical products
20299	Titanium boride (TiB2.1)	112874-88-1	1%	chemical products
20300	Nickel sulfide (NiO.98S)	112874-99-4	Contains (regardless of intentional or impurities)	chemical products
20301	Molybdenum carbide (Mo0.59Co0.41)	112909-68-9	1%	chemical products
20302	Titanium boride (TiB2.9)	112909-91-8	1%	chemical products
20303	Nickel selenide (Ni0.98Se)	112965-42-1	Contains (regardless of intentional or impurities)	chemical products
20304	Gallium arsenide phosphide (GaAs0.55-1P0-0.45)	113015-80-8	1,000ppm	chemical products
20305	Chromium zinc oxide (Cr1.9Zn1.14O4)	113015-82-0	Intentional addition / 1,000ppm	chemical products
20306	Lithium cobalt nickel oxide	113066-89-0	Contains (regardless of intentional or impurities)	chemical products
20307	Benzene, diethenyl-, polymer with ethenylbenzene and ethenylethylbenzene, aminomethylated, borate	113114-04-8	1%	chemical products
20308	Lithium molybdenum oxide (Li0.3-2Mo2O4)	113128-56-6	1%	chemical products
20309	Chromate(7-), bis[4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfonyl]azo]-6-[[3-sulfonyl]amino]-2-naphthalenesulfonato(5-)-], potassium sodium	113163-33-0	Contains (regardless of intentional or impurities)	chemical products
20310	Zirconium, hydroxy lactate sodium complex	113184-20-6	Contains (regardless of intentional or impurities)	chemical products
20311	Arsenic selenide (As0.2Se0.8)	113229-01-9	Contains (regardless of intentional or impurities)	chemical products
20312	Zirconate(3-), [2,2-bis[(2-propenyloxy)methyl]-1-butanolato-O]]P,P-diisooctyl diphosphato(2-)-O]]bis[P,P-diisooctyl diphosphato(2-)-O]]-, trihydrogen	113252-64-5	Contains (regardless of intentional or impurities)	chemical products
20313	Lithium molybdenum oxide (Li0.1-1.7MoO3)	113257-30-0	1%	chemical products
20314	Lithium molybdenum oxide (Li0.1-1.2MoO2.89)	113257-31-1	1%	chemical products
20315	1,3-Dioxo-7,8-dithia-2-stannacycloundecane-4,11-dione, 2,2-dicytlyl-	113289-87-5	Intentional addition / 1,000ppm	chemical products
20316	1,3-Dioxo-7,8-dithia-2-stannacycloundecane-4,11-dione, 2,2-dibutyl-	113289-90-0	Intentional addition / 1,000ppm	chemical products
20317	1,3-Dioxo-7,8-dithia-2-stannacycloundecane-4,11-dione, 2-butyl-	113289-91-1	Intentional addition / 1,000ppm	chemical products
20318	Copper selenide (Cu1.98Se)	113329-64-9	Contains (regardless of intentional or impurities)	chemical products
20319	Nickel sulfide (Ni2S7)	113329-92-3	Contains (regardless of intentional or impurities)	chemical products
20320	Cobalt sulfide (Co2S9)	113329-94-5	Intentional addition / 1%	chemical products
20321	Semduramin	113378-31-7	Intentional addition	chemical products
20322	Molybdenum silicide (MoSi2.25)	113384-43-3	1%	chemical products
20323	Manganese, [[1,2-ethanediy]bis[carbomethioato]](2-)-, mixture with (1.alpha.,2.alpha.,3.beta.,4.alpha.,5.alpha.,6.beta.)-1,2,3,4,5,6-hexachlorocyclohexane	113387-15-8	Contains (regardless of intentional or impurities)	chemical products
20324	5-Thia-1-azabicyclo[4.2.0]oct-2-ene-2-carboxylic acid, 7-amino-3-(chloromethyl)-8-oxo-, (4-methoxyphenyl)methyl ester, hydrochloride (1:1), (6R,7R)-	113479-65-5	Contains (regardless of intentional or impurities)	chemical products
20325	Gallium arsenide phosphide (GaAs0.2-1P0-0.8)	113515-10-9	1,000ppm	chemical products
20326	1,2-Epoxy-3-(4-vinylbenzoyloxy)propane	113538-80-0	Contains (regardless of intentional or impurities)	chemical products
20327	Manganese oxide (MnO1.8)	113553-16-5	1%	chemical products
20328	Manganese oxide (MnO1.81)	113553-18-7	1%	chemical products
20329	Copper selenide (Cu1.8-1.98Se)	113553-55-2	Contains (regardless of intentional or impurities)	chemical products
20330	Gallium arsenide phosphide (Ga0.87As0.13P)	113553-75-6	1,000ppm	chemical products
20331	Cibafast N	113573-08-3	Intentional addition / 1,000ppm	chemical products
20332	Cobalt sulfide (CoS5)	113663-43-7	Intentional addition / 1%	chemical products
20333	Lithium molybdenum oxide (Li0.67MoO2)	113670-97-6	1%	chemical products
20334	Lithium molybdenum oxide (Li0.33MoO2)	113670-98-7	1%	chemical products
20335	Barium titanium oxide (Ba0.15Ti0.85O1.85)	113672-05-2	Intentional addition	chemical products
20336	Barium titanium oxide (Ba0.23Ti0.77O1.78)	113672-06-3	Intentional addition	chemical products
20337	Barium titanium oxide (Ba0.18Ti0.82O1.82)	113672-07-4	Intentional addition	chemical products
20338	Manganese oxide (MnO1.01)	113672-10-9	1%	chemical products
20339	Molybdenum, bis(O,O-bis[1,3-dimethylbutyl] phosphorodithioato-S,S')dioxido-mu.-thioxido-	113678-04-9	Contains (regardless of intentional or impurities)	chemical products
20340	Molybdenum silicide (MoSi2.77)	113690-93-0	1%	chemical products
20341	Molybdenum silicide (MoSi2.63)	113690-94-1	1%	chemical products
20342	Molybdenum silicide (MoSi1.85)	113690-95-2	1%	chemical products
20343	Molybdenum silicide (MoSi0.92)	113690-96-3	1%	chemical products
20344	Phosphorodithioic acid, mixed O,O-bis(sec-butyl and isooctyl) esters, zinc salts	113706-15-3	Intentional addition / 1,000ppm	chemical products
20345	Aluminum molybdenum oxide (Al1.74Mo0.07O2.83)	113725-07-8	1%	chemical products
20346	(2R,3R)-2,3-Dihydroxybutanedioic acid, nickel(2+) salt (2:3), hexahydrate	113738-82-2	Contains (regardless of intentional or impurities)	chemical products
20347	Iron boride (FeB2)	113787-07-8	1%	chemical products
20348	Manganese boride (MnB22)	113787-08-9	Contains (regardless of intentional or impurities)	chemical products
20349	Gallium arsenide phosphide (GaAs0.95P0.05)	113876-86-1	1,000ppm	chemical products
20350	Thiaphthene-3-boronic acid	113893-08-6	1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
20350	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, amineosulfonyl sulfo [[4-[[2-(sulfoxo)ethyl]sulfonyl]phenyl]amino]sulfonyl derivatives, potassium sodium salts	113894-87-4	Intentional addition / 1,000ppm	chemical products
20351	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfo [[4-[[2-(sulfoxo)ethyl]sulfonyl]phenyl]amino]sulfonyl derivatives, potassium sodium salts	113894-88-5	Contains (regardless of intentional or impurities)	chemical products
20352	Nickelate(6-), [4-[[5-[[3,6-dichloro-4-pyridazinyl]carbonyl]amino]-2-sulfonyl]azo]-4,5-dihydro-5-oxo-1-[[5-[[trifluoro-29H,31H-phthalocyaninyl]sulfonyl]amino]-2-sulfonyl]-1H-pyrazole-3-carboxylato(8-)-N29,N30,N31,N32]-, sodium	113894-89-6	Contains (regardless of intentional or impurities)	chemical products
20353	Gallium arsenide phosphide (GaAs0.44P0.56)	113919-96-3	1,000ppm	chemical products
20354	Gallium arsenide phosphide (GaAs0.48P0.52)	113919-97-4	1,000ppm	chemical products
20355	Gallium arsenide phosphide (GaAs0.49P0.51)	113919-98-5	1,000ppm	chemical products
20356	Gallium arsenide phosphide (GaAs0.12P0.88)	113920-24-4	1,000ppm	chemical products
20357	Molybdenum silicide (MoSi2-2.6)	113939-39-2	1%	chemical products
20358	Gallium arsenide phosphide (GaAs0.9-1P0.3-1)	113959-74-3	1,000ppm	chemical products
20359	Benzenethiosulfonic acid S-(chloromethyl) ester	113975-44-3	1%	chemical products
20360	Yttrium 2-ethylhexanoate	114012-65-6	1%	chemical products
20361	Copper, aminomethylated divinylbenzene-ethenyl(ethyl)benzene-styrene polymer EDTA complexes	114060-59-2	Intentional addition / 1,000ppm	chemical products
20362	Manganese, aminomethylated divinylbenzene-ethenyl(ethyl)benzene-styrene polymer EDTA complexes	114060-61-6	Contains (regardless of intentional or impurities)	chemical products
20363	3,4-Difluoro-2-methoxyaniline	114076-35-6	1%	chemical products
20364	Lithium molybdenum oxide (Li7Mo5O12)	114105-14-5	1%	chemical products
20365	Lithium molybdenum oxide (Li6Mo5O12)	114105-21-4	1%	chemical products
20366	Pyrimido[1,2-a]azepinium, 2,3,4,6,7,8,9,10-octahydro-1-(phenylmethyl)-, tetraphenylborate(1-)	114367-12-3	1%	chemical products
20367	Fenbuconazole	114369-43-6	Contains (regardless of intentional or impurities)	chemical products
20368	Cuprate(4-), [3-[[[4-bis[[2-[[2-chloroethyl]sulfonyl]ethyl]amino]-6-chloro-1,3,5-triazin-2-yl]amino]-1-hydroxy-3,6-disulfo-2-naphthalenyl]azo]-4-hydroxy-1,5-naphthalenedisulfonato(6-)]-, sodium	114535-79-4	Intentional addition / 1,000ppm	chemical products
20369	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-[[3-aminopropyl]methylamino]propyl]amino]sulfonyl derivatives, acetates lactates methanesulfonates	114553-49-0	Intentional addition / 1,000ppm	chemical products
20370	Manganate(1-), [4-[[2,5-dichloro-4-sulfonyl]azo]-4,5-dihydro-5-oxo-1-phenyl-1H-pyrazole-3-carboxylato(3-)]-, hydrogen	114679-30-0	Contains (regardless of intentional or impurities)	chemical products
20371	Gallium arsenide phosphide (GaAs0.02P0.98)	114755-61-2	1,000ppm	chemical products
20372	Gallium arsenide phosphide (GaAs0.13P0.87)	114756-91-1	1,000ppm	chemical products
20373	[1,1-Biphenyl]-2-carboxylic acid, 4-(bromomethyl)-, methyl ester	114772-38-2	Contains (regardless of intentional or impurities)	chemical products
20374	[1,1-Biphenyl]-2-carboxylic acid, 4-(bromomethyl)-, 1,1-dimethylethyl ester	114772-40-6	Contains (regardless of intentional or impurities)	chemical products
20375	2-(4-Methylphenyl)benzenecarbonitrile	114772-53-1	Intentional addition	chemical products
20376	4-(Bromomethyl)biphenyl-2-carbonitrile	114772-54-2	Intentional addition	chemical products
20377	Acetic acid, trichloro-, strychnine salt	114793-33-8	Contains (regardless of intentional or impurities)	chemical products
20378	Borate(1-), bis[alpha-(hydroxy-kappa O)-alpha-phenylbenzenecetato(2-)-kappa O]-, potassium, (T-4)-	114803-11-1	1%	chemical products
20379	Cobalt oxide (CoO0.31)	114818-38-1	Intentional addition / 1%	chemical products
20380	Cobalt oxide (CoO0.07)	114818-39-2	Intentional addition / 1%	chemical products
20381	Cobalt oxide (CoO0.54)	114818-40-5	Intentional addition / 1%	chemical products
20382	Cobalt oxide (CoO0.36)	114818-41-6	Intentional addition / 1%	chemical products
20383	Cobalt oxide (CoO0.07-0.67)	114818-42-7	Intentional addition / 1%	chemical products
20384	Cobalt oxide (CoO0.67)	114819-02-2	Intentional addition / 1%	chemical products
20385	Gallium arsenide phosphide (GaAs0.9-1P0.0-1)	114824-20-3	1,000ppm	chemical products
20386	Methylum, [4-(dimethylamino)phenyl]bis[4-(ethylamino)-3-methylphenyl]-, molybdatephosphate	114862-93-0	1%	chemical products
20387	Chromate(5-), [4-hydroxy-6-[[2-(2-hydroxy-5-methylphenyl)azo]-3-[[2-hydroxy-3-nitro-5-sulfonyl]azo]-2-naphthalenesulfonato(4-)]][4-hydroxy-6-[[2-(2-hydroxy-5-methylphenyl)azo]-3-[[2-hydroxy-5-nitro-3-sulfonyl]azo]-2-naphthalenesulfonato(4-)]]-, potassium sodium	114886-92-9	Contains (regardless of intentional or impurities)	chemical products
20388	Chromate(5-), bis[4-hydroxy-6-[[2-(2-hydroxy-5-methylphenyl)azo]-3-[[2-hydroxy-3-nitro-5-sulfonyl]azo]-2-naphthalenesulfonato(4-)]]-, potassium sodium	114886-93-0	Contains (regardless of intentional or impurities)	chemical products
20389	Chromate(5-), bis[4-hydroxy-6-[[2-(2-hydroxy-5-methylphenyl)azo]-3-[[2-hydroxy-5-nitro-3-sulfonyl]azo]-2-naphthalenesulfonato(4-)]]-, potassium sodium	114886-94-1	Contains (regardless of intentional or impurities)	chemical products
20390	Chromate(5-), bis[6-(acetylamino)-4-hydroxy-3-[[2-(2-hydroxy-5-nitro-3-sulfonyl]azo)-2-naphthalenesulfonato(4-)]]-, potassium sodium	114886-95-2	Contains (regardless of intentional or impurities)	chemical products
20391	Chromate(5-), [6-(acetylamino)-4-hydroxy-3-[[2-(2-hydroxy-5-nitro-3-sulfonyl]azo)-2-naphthalenesulfonato(4-)]][4-hydroxy-6-[[2-(2-hydroxy-5-methylphenyl)azo]-3-[[2-hydroxy-5-nitro-3-sulfonyl]azo]-2-naphthalenesulfonato(4-)]]-, potassium sodium	114886-96-3	Contains (regardless of intentional or impurities)	chemical products
20392	Chromate(5-), [6-(acetylamino)-4-hydroxy-3-[[2-(2-hydroxy-3-nitro-5-sulfonyl]azo)-2-naphthalenesulfonato(4-)]][4-hydroxy-6-[[2-(2-hydroxy-5-methylphenyl)azo]-3-[[2-hydroxy-3-nitro-5-sulfonyl]azo]-2-naphthalenesulfonato(4-)]]-, potassium sodium	114886-97-4	Contains (regardless of intentional or impurities)	chemical products
20393	Chromate(5-), [6-(acetylamino)-4-hydroxy-3-[[2-(2-hydroxy-5-nitro-3-sulfonyl]azo)-2-naphthalenesulfonato(4-)]][4-hydroxy-6-[[2-(2-hydroxy-5-methylphenyl)azo]-3-[[2-hydroxy-3-nitro-5-sulfonyl]azo]-2-naphthalenesulfonato(4-)]]-, potassium sodium	114886-98-5	Contains (regardless of intentional or impurities)	chemical products
20394	Chromate(5-), [6-(acetylamino)-4-hydroxy-3-[[2-(2-hydroxy-3-nitro-5-sulfonyl]azo)-2-naphthalenesulfonato(4-)]][6-(acetylamino)-4-hydroxy-3-[[2-(2-hydroxy-5-nitro-3-sulfonyl]azo)-2-naphthalenesulfonato(4-)]]-, potassium sodium	114886-99-6	Contains (regardless of intentional or impurities)	chemical products
20395	Chromate(5-), [6-(acetylamino)-4-hydroxy-3-[[2-(2-hydroxy-3-nitro-5-sulfonyl]azo)-2-naphthalenesulfonato(4-)]][4-hydroxy-6-[[2-(2-hydroxy-5-methylphenyl)azo]-3-[[2-hydroxy-5-nitro-3-sulfonyl]azo]-2-naphthalenesulfonato(4-)]]-, potassium sodium	114887-00-2	Contains (regardless of intentional or impurities)	chemical products
20396	Chromate(5-), bis[4-amino-5-hydroxy-6-[[2-(2-hydroxy-5-nitrophenyl)azo]-1,7-naphthalenedisulfonato(4-)]]-, pentasodium	114887-04-6	Contains (regardless of intentional or impurities)	chemical products
20397	Methylum, bis[4-(dimethylamino)phenyl][4-(ethylamino)-3-methylphenyl]-, molybdatephosphate	114887-05-7	1%	chemical products
20398	Cobalt sulfide (Co0-1S)	114901-09-6	Intentional addition / 1%	chemical products
20399	Cobalt sulfide (Co4S2-4)	114901-10-9	Intentional addition / 1%	chemical products
20400	Boron carbide (B15C)	114901-42-7	1%	chemical products
20401	Boron carbide (B13C)	114901-43-8	1%	chemical products
20402	Barium titanium oxide (Ba0.97-1.04Ti4O8.97-9.04)	114901-52-9	Intentional addition	chemical products
20403	Manganese oxide (MnO1.96)	114902-06-6	1%	chemical products
20404	Manganese sulfide (Mn0.9S)	114927-28-5	1%	chemical products
20405	Hexane, 1-bromo-4-methyl-, (R)-	114927-30-9	1,000ppm	chemical products
20406	Diphosphoric acid, cobalt(2+) salt (1:2), pentahydrate	114950-15-1	Intentional addition / 1%	chemical products
20407	Chromate(5-), bis[6-(acetylamino)-4-hydroxy-3-[[2-(2-hydroxy-3-nitro-5-sulfonyl]azo)-2-naphthalenesulfonato(4-)]]-, potassium sodium	114959-47-6	Contains (regardless of intentional or impurities)	chemical products
20408	Chromium, hydroxybis(2-hydroxybenzoato-O1,O2)-, ar,ar'-di-C14-18-alkyl derivatives	114959-48-7	1,000ppm	chemical products
20409	Titanium boride (Ti0.0-0.52B0.48-0.77)	114965-83-2	1%	chemical products
20410	Titanium boride (Ti0.32B0.68)	114965-84-3	1%	chemical products
20411	Gallium arsenide phosphide (GaAs0.07P0.93)	114966-14-2	1,000ppm	chemical products
20412	Quazatine triacetate	115044-19-4	Intentional addition / 1,000ppm	chemical products
20413	Iron, complexes with diazotized 3-aminobenzenesulfonic acid coupled with diazotized 2-amino-5-nitrobenzenesulfonic acid, diazotized 2-[[4-(aminophenyl)amino]-5-nitrobenzenesulfonic acid and 4-[[2-(2-hydroxy-3,5-dinitrophenyl)azo]-1,3-benzenediol, sodium salts	115100-55-5	1%	chemical products
20414	Barium nitrite hydrate	115216-77-8	Intentional addition / 1,000ppm	chemical products
20415	Benzoic acid, (1,1-dimethylethyl)-, barium salt	115218-70-7	Intentional addition / 1,000ppm	chemical products
20416	Lithium molybdenum oxide (Li1.5MoO3)	115232-90-1	1%	chemical products
20417	Copper selenide (Cu1.96-2Se)	115233-24-4	Contains (regardless of intentional or impurities)	chemical products
20418	Barium titanium oxide (BaTi4.6O10.2)	115233-40-4	Intentional addition	chemical products
20419	Barium titanium oxide (BaTi4.4O9.8)	115233-41-5	Intentional addition	chemical products
20420	2,3-Dibromobiphenyl	115245-06-2	Intentional addition / 1,000ppm	chemical products
20421	2,4,5-Tribromobiphenyl	115245-07-3	Intentional addition / 1,000ppm	chemical products
20422	3,4,5-Tribromobiphenyl	115245-08-4	Intentional addition / 1,000ppm	chemical products
20423	2,3,4,5-Tetrabromobiphenyl	115245-09-5	Intentional addition / 1,000ppm	chemical products
20424	2,3,4,6-Tetrabromobiphenyl	115245-10-8	Intentional addition / 1,000ppm	chemical products
20425	(S)-Glycidyl 3-nitrobenzenesulfonate	115314-14-2	1%	chemical products
20426	Benzenesulfonic acid, 3-nitro-, oxiranylmethyl ester, (R)-	115314-17-5	Contains (regardless of intentional or impurities)	chemical products
20427	Chromate(1-), hydroxy[2-hydroxy-3-[[2-(2-hydroxy-5-nitrophenyl)methylene]amino]-5-nitrobenzenesulfonato(3-)]-, hydrogen, compound with 3-[[2-ethylhexyloxy]-1-propanamine (1:1)	115341-05-4	Contains (regardless of intentional or impurities)	chemical products
20428	2-Aminobenzenboronic acid, N-BOC protected	115377-94-1	1%	chemical products
20429	Boron carbide (B32C)	115390-29-9	1%	chemical products
20430	Gallium arsenide phosphide (GaAs0.06P0.4-1)	115454-39-2	1,000ppm	chemical products
20431	Chromate(1-), diaquabis[7-(1,1-dimethylethyl)-3-hydroxy-2-naphthalenecarboxylato(2-)-O2,O3]-, hydrogen, (OC-6-12)-	115465-57-1	Contains (regardless of intentional or impurities)	chemical products
20432	Cuprate(4-), [2-[[[3-[[5-chloro-2-fluoro-6-methyl-4-pyrimidinyl]amino]-2-hydroxy-5-sulfonyl]azo][2-sulfonyl]methyl]azo]-4-sulfonylbenzoato(6-)]-, tetrasodium	115487-36-0	Intentional addition / 1,000ppm	chemical products
20433	Arsenic selenide (As7Se13)	115493-57-7	Contains (regardless of intentional or impurities)	chemical products
20434	Molybdenum silicide (Mo3Si4)	115516-71-7	1%	chemical products
20435	Chromium copper oxide (Cr2.85Cu2.93O7)	115517-69-6	Intentional addition / 1,000ppm	chemical products
20436	Chromium copper oxide (Cr2.85Cu2.207)	115517-70-9	Intentional addition / 1,000ppm	chemical products
20437	Chromium copper oxide (Cr0.77Cu4.10O5)	115517-71-0	Intentional addition / 1,000ppm	chemical products
20438	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [[3-[[3-aminopropyl]methylamino]propyl]amino]sulfonyl derivatives	115535-39-2	Intentional addition / 1,000ppm	chemical products
20439	Chromium zinc oxide (Cr0.47Zn0.29O)	115658-56-5	Intentional addition / 1,000ppm	chemical products
20440	Chromium zinc oxide (Cr0.44Zn0.34O)	115658-57-6	Intentional addition / 1,000ppm	chemical products
20441	Nickel oxide (NiO1.5-1.8)	115683-18-6	Contains (regardless of intentional or impurities)	chemical products
20442	Rac-[dimethylsilyl-bis(4,5,6,7-tetrahydro-1H-inden-1-yl)]zirconium dichloride	115701-70-7	Contains (regardless of intentional or impurities)	chemical products
20443	Barium calcium copper thallium oxide	115866-07-4	Intentional addition / 1,000ppm	chemical products
20444	4-Bromo-2-methoxyimino-3-oxobutyl chloride	115922-43-5	Contains (regardless of intentional or impurities)	chemical products
20445	(E)-9-Chloronona-2-eneal	115932-80-4	Contains (regardless of intentional or impurities)	chemical products
20446	Chromium lanthanum oxide (Cr1.7La0.3O3)	115949-83-2	Intentional addition / 1,000ppm	chemical products
20447	Chromium lanthanum oxide (Cr1.7-2La0-0.3O3)	115949-89-8	Intentional addition / 1,000ppm	chemical products
20448	Stychnidin-10-one, mono[(S)-5-[[4-ethyl-2,5-dihydro-3-methyl-5-oxo-1H-pyrrol-2-yl]methyl]-4-methyl-1H-pyrrole-2-carboxylate]	115976-57-3	Contains (regardless of intentional or impurities)	chemical products
20449	Stychnidin-10-one, mono[(R)-5-[[4-ethyl-2,5-dihydro-3-methyl-5-oxo-1H-pyrrol-2-yl]methyl]-4-methyl-1H-pyrrole-2-carboxylate]	115976-60-8	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
20450	Chromate(3-), [4-amino-5-hydroxy-6-[[2-hydroxy-5-nitrophenyl]azo]-1,7-naphthalenedisulfonato(4-)](2-)[5-(aminosulfonyl)-2-hydroxyphenyl]azo-3-oxo-N-phenylbutanamide(2-)-, trisodium	116032-59-8	Contains (regardless of intentional or impurities)	chemical products
20451	Chromium boride (Cr5B2)	116049-38-8	1,000ppm	chemical products
20452	Arsenic selenide (As0.05Se0.5-1)	116065-96-4	Contains (regardless of intentional or impurities)	chemical products
20453	Arsenic selenide (As0.1-0.4Se0.8-0.9)	116099-09-3	Contains (regardless of intentional or impurities)	chemical products
20454	Cuprate(2-), [[2,2'-[29H,31H-phthalocyanine-C,C-diybis(methylureineiminoacetyl)]bis(benzoato)](4-)-N2,9,N30,N31,N32]-, barium (1:1)	116107-50-7	Intentional addition / 1,000ppm	chemical products
20455	N2'-[(S)-1-Ethoxycarbonyl-3-oxo-3-phenylpropyl]-N2-trifluoroacetyl-L-lysine	116189-88-1	Contains (regardless of intentional or impurities)	chemical products
20456	Barium titanium oxide (Ba0.99Ti0.99O3)	116234-73-2	Intentional addition	chemical products
20457	Boron nitride (B0.4-0.6N0.4-0.6)	116295-03-1	1%	chemical products
20458	Boron nitride (B0.3-0.7N0.3-0.7)	116295-04-2	1%	chemical products
20459	Chromium zinc oxide (Cr0.01Zn0.97O1.02)	116305-12-5	Intentional addition / 1,000ppm	chemical products
20460	Bismuth [mu-[[ethanedioato(2-)-O,O']O,O']]bis[ethanedioato(2-)-O,O']di-	116321-85-8	Intentional addition	chemical products
20461	Gallium arsenide phosphide (GaAs0.86P0.14)	116327-09-4	1,000ppm	chemical products
20462	Manganese boride	116348-63-1	Contains (regardless of intentional or impurities)	chemical products
20463	2-Hydroxy-11H-benzo[a]carbazole-3-carboxylic acid sodium salt	116353-24-3	Contains (regardless of intentional or impurities)	chemical products
20464	Gallium arsenide phosphide (GaAs0.54P0.46)	116359-50-3	1,000ppm	chemical products
20465	Gallium arsenide phosphide (GaAs0.43P0.57)	116359-51-4	1,000ppm	chemical products
20466	3-Amino-5-carboxybenzeneboronic acid	116378-40-6	1%	chemical products
20467	Lithium molybdenum oxide (Li0.06-0.5MoO3)	116442-78-5	1%	chemical products
20468	Molybdenum potassium oxide (MoK0.02-0.17O3)	116442-88-7	1%	chemical products
20469	Molybdenum sodium oxide (MoNa0.1-0.36O3)	116442-89-8	1%	chemical products
20470	Nickel sulfide (NiS1.03)	116443-84-6	Contains (regardless of intentional or impurities)	chemical products
20471	1,4-Dibutoxy-2,3-naphthalenedicarbonitrile	116453-89-5	Intentional addition	chemical products
20472	Benzenamine, 3-methyl-, hydrobromide	116468-99-6	Intentional addition / 25%	chemical products
20473	Arsenic selenide (As0.3-0.4Se0.6-0.7)	116473-38-2	Contains (regardless of intentional or impurities)	chemical products
20474	3-Methylhexane	116502-45-5	1%	chemical products
20475	Boron carbide (B0.8-0.92C0.08-0.2)	116590-53-5	1%	chemical products
20476	Manganese(2+), bis(octahydro-1,4,7-trimethyl-1H-1,4,7-triazonine-N1,N4,N7)tri-mu-oxodi-, hexafluorophosphate (1:2)	116633-52-4	Contains (regardless of intentional or impurities)	chemical products
20477	Bis(N,N,N'-trimethyl-1,4,7-triazacyclononane)-trioxodimanganese(IV) di(hexafluorophosphate) monohydrate	116633-53-5	Contains (regardless of intentional or impurities)	chemical products
20478	Molybdenum carbide (MoC0.8)	116640-58-5	1%	chemical products
20479	Molybdenum carbide (Mo0.66C0.34)	116640-59-6	1%	chemical products
20480	Gallium arsenide phosphide (GaAs0.8-1P0.2)	116678-39-8	1,000ppm	chemical products
20481	Barium titanium oxide (Ba0.99Ti0.99O3)	116678-71-8	Intentional addition	chemical products
20482	Strychnine (S,S)-tartrate trihydrate	116708-31-7	Contains (regardless of intentional or impurities)	chemical products
20483	Strychnine (R,R)-bitartrate hexahydrate	116728-44-0	Contains (regardless of intentional or impurities)	chemical products
20484	Gallium arsenide phosphide (GaAs0.82P0.18)	116769-68-7	1,000ppm	chemical products
20485	Gallium arsenide phosphide (GaAs0.74P0.26)	116769-69-8	1,000ppm	chemical products
20486	Quaternary ammonium compounds, trimethyltallow alkyl, hexa-mu-oxotetra-mu.3-oxodi-mu.5-oxotetradecaooctamolybdate(4-)(4:1)	116810-46-9	Contains (regardless of intentional or impurities)	chemical products
20487	Gallium arsenide phosphide (GaAs0.89P0.11)	116812-48-7	1,000ppm	chemical products
20488	Copper selenide (Cu1.75-2Se)	116812-56-7	Contains (regardless of intentional or impurities)	chemical products
20489	Molybdenum silicide (Mo0.76Si0.24)	116812-71-6	1%	chemical products
20490	Gallium arsenide phosphide (GaAs0.52P0.48)	116812-72-7	1,000ppm	chemical products
20491	2-(Fluoromethoxyimino)propane-1,3-dinitrile	116833-13-7	1%	chemical products
20492	3-Amino-2-(fluoromethoxyimino)-3-iminopropanenitrile acetic acid	116833-14-8	Contains (regardless of intentional or impurities)	chemical products
20493	Tetracosanoic acid, cadmium	116854-17-2	Intentional addition / 1,000ppm	chemical products
20494	Butane, heptafluoro-	116886-99-0	1,000ppm	chemical products
20495	Pentachlorodifluoropropane	116887-32-4	Intentional addition / 1,000ppm	chemical products
20496	Dichlorotrifluoropropane	116890-51-8	1,000ppm	chemical products
20497	C.I. Reactive Blue 244	116912-62-0	Contains (regardless of intentional or impurities)	chemical products
20498	Cobalt chloro cyano 1,2-dimethoxyethane zinc complexes	116912-63-1	Intentional addition / 1%	chemical products
20499	Tricosanoic acid, cadmium	116920-59-3	Contains (regardless of intentional or impurities)	chemical products
20500	2,4,8-Tris(5-(4-bromophenylazo)-2-hydroxyphenyl)boroxin	116999-16-7	1%	chemical products
20501	Gallium arsenide phosphide (GaAs0.84P0.16)	117003-66-4	1,000ppm	chemical products
20502	Gallium arsenide phosphide (GaAs0.75-0.95P0.05-0.25)	117067-25-1	1,000ppm	chemical products
20503	Gallium arsenide phosphide (GaAs0.85P0.15)	117067-26-2	1,000ppm	chemical products
20504	Gallium arsenide phosphide (GaAs0.94P0.06)	117067-27-3	1,000ppm	chemical products
20505	Phosphoric acid, cobalt(2+) salt (6:7)	117091-68-6	Intentional addition / 1%	chemical products
20506	5-Amino-2-hydroxymethylphenylboronic acid, hydrochloride, dehydrate	117098-93-8	1%	chemical products
20507	Zirconium [2,2-bis[(2-propenyloxy)methyl]-1-butanolato-O,O']tris(diisooctyl phosphato-O)-	117101-65-2	Contains (regardless of intentional or impurities)	chemical products
20508	Gallium arsenide phosphide (GaAs0.5-0.67P0.33-0.5)	117127-08-9	1,000ppm	chemical products
20509	Nickel copper ferrite	117127-26-1	Contains (regardless of intentional or impurities)	chemical products
20510	Gallium arsenide phosphide (GaAs0.99P0.01)	117166-17-3	1,000ppm	chemical products
20511	Gallium arsenide phosphide (GaAs0.6-0.8P0.2-0.4)	117166-30-0	1,000ppm	chemical products
20512	Gallium arsenide phosphide (GaAs0.73P0.27)	117166-31-1	1,000ppm	chemical products
20513	Zirconium boride (ZrB2.7)	117167-50-7	Contains (regardless of intentional or impurities)	chemical products
20514	Ferrate(1-), [[N,N'-1,3-propanediylbis[N-(carboxymethyl)glycinato]](4-)-N,N',O,O',ON,ON]-, (OC-6-21)-	117198-20-6	1%	chemical products
20515	Sodium 2-cyano-3-(4-methoxyphenyl)acrylate	117209-33-3	Intentional addition	chemical products
20516	Molybdenum silicide (MoSi1.7)	117314-43-9	1%	chemical products
20517	Boron nitride (B0.7N0.3)	117315-62-5	1%	chemical products
20518	Boron nitride (B0.6N0.4)	117315-63-6	1%	chemical products
20519	Gallium arsenide phosphide (GaAs0.03P0.97)	117315-65-8	1,000ppm	chemical products
20520	1-Tetradecanaminium, N,N-dimethyl-N-tetradecyl-, hexa-mu-oxotetra-mu.3-oxodi-mu.5-oxotetradecaooctamolybdate(4-)(4:1)	117342-25-3	Contains (regardless of intentional or impurities)	chemical products
20521	cis-Bis(5-nitrotetrazolato)tetraamine cobalt(III) perchlorate	117412-28-9	1%	chemical products
20522	Copper selenide (Cu1.86Se)	117449-21-5	Contains (regardless of intentional or impurities)	chemical products
20523	Copper selenide (Cu1.86-1.92Se)	117449-22-6	Contains (regardless of intentional or impurities)	chemical products
20524	Nickel(II) perbromate	117454-32-7	Contains (regardless of intentional or impurities)	chemical products
20525	3-Chloro-4-fluorobenzonitrile	117482-84-5	Intentional addition	chemical products
20526	Methanaminium, N,N,N-trimethyl-, (T-4)-butyltriphenylborate(1-)	117522-01-7	1%	chemical products
20527	3H-Indolium, 1-heptyl-2-[3-(1-heptyl-1,3-dihydro-3,3-dimethyl-2H-indol-2-ylidene)-1-propenyl]-3,3-dimethyl-, (T-4)-butyltriphenylborate(1-)	117522-03-9	1%	chemical products
20528	Amines, C12-14-tert-alkyl, compounds with 1-[[5-(1,1-dimethylpropyl)-2-hydroxy-3-nitrophenyl]azo]-2-naphthalenol-1-[[2-hydroxy-4(or 5)-nitrophenyl]azo]-2-naphthalenol chromium complexes	117527-94-3	Contains (regardless of intentional or impurities)	chemical products
20529	L-Ascorbic acid, compound with strychnidin-10-one (1:1)	117552-81-5	Contains (regardless of intentional or impurities)	chemical products
20530	Molybdenum silicide (MoSi0.2-3)	117595-43-4	1%	chemical products
20531	Manganese, [[1,2-ethanediybis(carbamodithioato)](2-)]-, mixture with 1-[2-(2,4-dichlorophenyl)pentyl]-1H-1,2,4-triazole and [[1,2-ethanediybis(carbamodithioato)](2-)]zinc	117660-41-0	Contains (regardless of intentional or impurities)	chemical products
20532	1-Butanaminium, N,N,N-tributyl-, bis(4-(1-(1-dimethylethyl)-1,2-benzenedithiolato(2-))-kappa.S.kappa.S')cuprate(1-)	117697-22-0	Intentional addition / 1,000ppm	chemical products
20533	5,12,14-Tetraoxo-6,13-distannaoctadeca-2,9,16-trienedioic acid, 6,6,13,13-tetraoctyl-4,8,11,15-tetraoxo-, didodecyl ester, (Z,Z,Z)-	117732-68-0	Intentional addition / 1,000ppm	chemical products
20534	Magnesium arsenide decahydrate	117746-50-6	Intentional addition / 1,000ppm	chemical products
20535	Zirconate(2-), tetrakis[2,2-bis[(2-propenyloxy)methyl]-1-butanolato-O1]bis(ditridecyl phosphato-O)-, dihydrogen	117753-51-2	Contains (regardless of intentional or impurities)	chemical products
20536	Cadmium sulfide (Cd0.55S0.45)	117912-89-7	Contains (regardless of intentional or impurities)	chemical products
20537	Cadmium sulfide (Cd0.53S0.47)	117912-90-0	Contains (regardless of intentional or impurities)	chemical products
20538	Cadmium sulfide (Cd0.52S0.48)	117912-91-1	Contains (regardless of intentional or impurities)	chemical products
20539	Lithium molybdenum oxide (Li1.3Mo3O8)	117931-10-9	1%	chemical products
20540	Benzene, 1,1'-oxybis[2,3,4,6-tetrabromo-	117964-21-3	1,000ppm	chemical products
20541	2-Chloro-1,1,1,3-tetrafluoropropane	117970-90-8	Intentional addition	chemical products
20542	C.I. Pigment Red 257	117989-29-4	Contains (regardless of intentional or impurities)	chemical products
20543	Molybdenum carbide (Mo2C0.94)	117991-26-1	1%	chemical products
20544	Molybdenum carbide (Mo2C0.99)	117991-27-2	1%	chemical products
20545	Nickel sulfide (Ni2.76S2)	117991-29-4	Contains (regardless of intentional or impurities)	chemical products
20546	Nickel sulfide (Ni2.83S2)	117991-30-7	Contains (regardless of intentional or impurities)	chemical products
20547	Molybdenum silicide (MoSi2.3)	118032-96-5	1%	chemical products
20548	Amines, C10-14-alkyl, [2,4-dihydro-4-[[2-hydroxy-5-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)](1-)[2-hydroxy-4-methyl-4-nitrophenyl]azo]-2-naphthalenolato(2-)]cobaltate(1-)(1:1)	118044-55-6	Intentional addition / 1%	chemical products
20549	Boronic acid, B-(2,3,4-trimethoxyphenyl)-	118062-05-8	1%	chemical products
20550	2-Benzothiazolethiol	118090-09-8	Intentional addition / 1%	chemical products
20551	Cuprate(4-), [C,C-bis[[[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]sulfonyl]-29H,31H-phthalocyanine-C,C-disulfonato(6-)-kappa.N29,kappa.N30,kappa.N31,kappa.N32]-, tetrahydrogen	118244-01-2	Intentional addition / 1,000ppm	chemical products
20552	Lithium molybdenum oxide (Li0.9-2MoO3)	118321-25-8	1%	chemical products
20553	Lithium molybdenum oxide (Li0.9MoO3)	118321-26-9	1%	chemical products
20554	Lithium molybdenum oxide (Li0.3MoO3)	118321-27-0	1%	chemical products
20555	Molybdenum sodium oxide (MoNa0.51O2)	118321-57-6	1%	chemical products
20556	Molybdenum sodium oxide (MoNa0.41O2)	118321-58-7	1%	chemical products
20557	Arsenic selenide (As0.05Se0.95)	118340-36-6	Contains (regardless of intentional or impurities)	chemical products
20558	Methanesulfonate (3S)-1-benzylpyrrolidine-3-yl	118354-71-5	Contains (regardless of intentional or impurities)	chemical products
20559	Bismuth calcium copper strontium oxide	118392-20-4	Intentional addition / 1,000ppm	chemical products
20560	Ethyl 4-chloro-2,2-dimethyl-4-pentenoate	118427-36-4	1%	chemical products
20561	5-tert-Butyl-2-methyl-2H-pyrazol-3-amine	118430-73-2	Contains (regardless of intentional or impurities)	chemical products
20562	1-Propanaminium, N-(2-hydroxyethyl)-N,N-dimethyl-3-[[1-oxododecyl]amino]-, perchlorate (salt)	118432-99-8	1,000ppm	chemical products
20563	Chromate(3-), [6-(5-chloro-2-hydroxy-4-nitrophenyl)azo]-5-hydroxy-1-naphthalenesulfonato(3-)](3)-3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-1-naphthalenesulfonato(3-)]-, sodium	118460-97-2	Contains (regardless of intentional or impurities)	chemical products
20564	Copper selenide (Cu1.88-2Se)	118478-84-5	Contains (regardless of intentional or impurities)	chemical products
20565	Chromate(3-), bis[6-(5-chloro-2-hydroxy-4-nitrophenyl)azo]-5-hydroxy-1-naphthalenesulfonato(3-)]-, sodium	118496-41-6	Contains (regardless of intentional or impurities)	chemical products
20566	Gold cyanide (Au(CN)2)	118499-69-7	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
20567	Disodium (3-methyl-4-(5-nitro-2-oxido)phenylazo)-1-phenylpyrazololato(1-)-(3-nitro-2-oxido-5-sulfonatophenylazo)-2-naphthalatochromate(1-)	118556-91-5	Contains (regardless of intentional or impurities)	chemical products
20568	Lanthanum boride (LaO.81B6)	118574-17-7	1%	chemical products
20569	1,2,3-Propanetriol, diester with boric acid (H3BO3)	118601-90-4	1%	chemical products
20570	Borate(1-), tetrakis(pentafluorophenyl)-, hydrogen, compound with N,N-dimethylbenzamine (1:1)	118612-00-3	Contains (regardless of intentional or impurities)	chemical products
20571	7-[4-(3-Diethylaminopropylamino)-6-(3-diethylaminopropylamino)-1,3,5-triazin-2-ylamino]-4-hydroxy-3-(4-phenylazophenylazo)-naphthalene-2-sulfonate, acetic acid, lactic acid (2:1:1)	118658-98-3	Contains (regardless of intentional or impurities)	chemical products
20572	1,3-Bipyridinium, 5,5'-[methylenebis(4,1-phenyleneazo)]bis[1'-[3-(dimethylamino)propyl]-1'-2'-dihydro-6'-hydroxy-4'-methyl-2'-oxo-, dichloride, dihydrochloride	118658-99-4	Contains (regardless of intentional or impurities)	chemical products
20573	Gallium arsenide phosphide (GaAs0.68P0.32)	118670-41-0	1,000ppm	chemical products
20574	Gallium arsenide phosphide (GaAs0.61-0.84P0.36-0.39)	118670-42-1	1,000ppm	chemical products
20575	Chromate(7-), bis[2-[[[4-chloro-6-[[4-[2-(4-nitro-2-sulfonylphenyl)ethenyl]-3-sulfonylamino]-1,3,5-triazin-2-ylamino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(5-)]-, lithium	118685-18-0	Contains (regardless of intentional or impurities)	chemical products
20576	Chromate(7-), bis[2-[[[4-chloro-6-[[4-[2-(4-nitro-2-sulfonylphenyl)ethenyl]-3-sulfonylamino]-1,3,5-triazin-2-ylamino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]benzoato(5-)]-, lithium sodium	118685-19-1	Contains (regardless of intentional or impurities)	chemical products
20577	Copper, [29H.31H-phthalocyaninato(2-)-N29.N30.N31.N32]-, [[2-chloroethoxy]sulfonyl sulfo derivatives, lithium salts	118685-20-4	Intentional addition / 1,000ppm	chemical products
20578	Copper, [29H.31H-phthalocyaninato(2-)-N29.N30.N31.N32]-, [[2-[(4-chloro-6-methoxy-1,3,5-triazin-2-ylamino)ethylamino]sulfonyl sulfo derivatives, lithium salts	118685-21-5	Intentional addition / 1,000ppm	chemical products
20579	Chromate(2-), [1-[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]-[4-hydroxy-3-(2-hydroxy-3,5-dinitrophenyl)azo]-7-[[4-methoxyphenyl]amino]-2-naphthalenesulfonato(3-)]-, disodium	118685-33-9	Contains (regardless of intentional or impurities)	chemical products
20580	Cuprate(3-), [3-[[5-hydroxy-4-(1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo)-2-methylphenyl]azo]-1,5-naphthalenedisulfonato(5-)]-, tripotassium	118716-59-9	Intentional addition / 1,000ppm	chemical products
20581	Nickelate(2-), [C-[[[3-[(4-amino-6-chloro-1,3,5-triazin-2-yl)amino]phenyl]amino]sulfonyl]-C-(aminosulfonyl)-29H.31H-phthalocyanine-C-C-disulfonato(4-)-N29.N30.N31.N32]-, disodium	118716-60-2	Contains (regardless of intentional or impurities)	chemical products
20582	Chromate(3-), [7-[[[aminohydroxyphenyl]azo]-3-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-2-naphthalenesulfonato(3-)]-[3-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-7-[[2-hydroxy-1-(phenylamino)carbonyl]-1-propenyl]azo]-2-naphthalenesulfonato(3-)]-, trisodium	118716-61-3	Contains (regardless of intentional or impurities)	chemical products
20583	Chromate(3-), bis[7-[[[aminohydroxyphenyl]azo]-3-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-2-naphthalenesulfonato(3-)]-, trisodium	118716-62-4	Contains (regardless of intentional or impurities)	chemical products
20584	Hexitol, diester with boric acid (H3BO3) (1:1)	118786-96-2	1%	chemical products
20585	(Tris(chloromethyl)phthalocyaninato)copper(II), reaction products with N-methylpiperazine and methoxyacetic acid	118800-27-4	Intentional addition / 1,000ppm	chemical products
20586	Cuprate(5-), [2-[[[2-hydroxy-5-sulfo-3-[[4-[[2-sulfoethyl]amino]-6-[[3-[[2-(sulfooxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-ylamino]phenyl]azo]phenylmethyl]azo]-4-sulfo]benzoato(7-)]-, pentasodium	118805-49-5	Intentional addition / 1,000ppm	chemical products
20587	Chromate(1-), bis[8-(butylamino)-1-[[2-hydroxy-4-nitrophenyl]azo]-2-naphthalenolato(2-)]-, sodium	118870-19-2	Contains (regardless of intentional or impurities)	chemical products
20588	Lithium molybdenum oxide (Li1.23Mo7)	118877-73-9	1%	chemical products
20589	Titanium boride (Ti10.23B0.77)	118956-66-4	1%	chemical products
20590	Benzhydrol, 4,4'-dichloro-alpha, -(dichloromethyl)-, compound with nicotine	118980-02-2	Contains (regardless of intentional or impurities)	chemical products
20591	Ferrate(1-), bis[4-[[5-chloro-2-hydroxyphenyl]azo]-3-hydroxy-N-phenyl-2-naphthalenecarboxamidato(2-)]-, hydrogen	119029-85-5	1%	chemical products
20592	Semduraminium sodium	119068-77-8	5,000ppm	chemical products
20593	Gold cyanide (Au(CN)2)	119107-37-8	Intentional addition / 1%	chemical products
20594	Manganese, [[1,2-ethanedylbis(carbamodithioato)](2-)]-, mixture with 2-cyano-N-[(ethylamino)carboxyl]-2-(methoxymino)acetamide and zinc sulfate (1:1)	119130-84-6	Contains (regardless of intentional or impurities)	chemical products
20595	Cuprate(1-), [2-[[[29H.31H-phthalocyanin-C-ylmethyl]amino]carbonyl]benzoato(3-)-N29.N30.N31.N32]-, barium (2:1)	119131-62-3	Intentional addition / 1,000ppm	chemical products
20596	Tebufenpyrad	119168-77-3	Contains (regardless of intentional or impurities)	chemical products
20597	2,4,6,8,9-Pentaoxa-3,7-distanna-1,5-diborabicyclo[3,3,1]nonane, 3,3,7,7-tetrakis(1,1-dimethylethyl)-	119192-22-2	Intentional addition / 1,000ppm	chemical products
20598	Manganese, [[1,2-ethanedylbis(carbamodithioato)](2-)]-, mixture with N-(2,6-dimethylphenyl)-2-methoxy-N-(2-oxo-3-oxazolidinyl)acetamide, [[1,2-ethanedylbis(carbamodithioato)](2-)]zinc and tridemorph	119219-12-4	Contains (regardless of intentional or impurities)	chemical products
20599	Sulfuric acid, cadmium salt (4:1)	119222-01-4	Contains (regardless of intentional or impurities)	chemical products
20600	2,2',3',3',4',4',5',5'-Heptabromobiphenyl	119264-54-9	1,000ppm	chemical products
20601	2,2',3',4',4',5',5'-Heptabromo[1,1'-biphenyl]	119264-55-0	1,000ppm	chemical products
20602	2,2',3',4',4',6,6'-Heptabromobiphenyl	119264-56-1	1,000ppm	chemical products
20603	2,2',3',4',5,6,6'-Heptabromobiphenyl	119264-57-2	1,000ppm	chemical products
20604	1,1'-Biphenyl, 2,2',3',4',5,6,6'-heptabromo-	119264-58-3	1,000ppm	chemical products
20605	2,2',3',3',4',4',6,6'-Octabromo-1,1'-biphenyl	119264-59-4	1,000ppm	chemical products
20606	2,2',3',3',4',5',6,6'-Octabromobiphenyl	119264-60-7	1,000ppm	chemical products
20607	2,2',3',4',4',5,6,6'-Octachloro-1,1'-biphenyl	119264-61-8	1,000ppm	chemical products
20608	2,2',3',3',4',4',5,6,6'-Nonabromobiphenyl	119264-62-9	1,000ppm	chemical products
20609	2,2',3',3',4',5',6,6'-Nonabromobiphenyl	119264-63-0	1,000ppm	chemical products
20610	Nicotine, malate (2:1)	119328-39-1	Contains (regardless of intentional or impurities)	chemical products
20611	Cobalt sulfide (Co0.95S)	119333-99-2	Intentional addition / 1%	chemical products
20612	Gallium arsenide phosphide (GaAs0.22P0.78)	119354-96-0	1,000ppm	chemical products
20613	Gallium arsenide phosphide (GaAs0.09P0.91)	119398-02-6	1,000ppm	chemical products
20614	Barium titanium oxide (Ba0.23Ti0.77O1.77)	119398-14-0	Intentional addition	chemical products
20615	Pyridine, 3-(1-methyl-2-pyrroliidinyl)-, conjugate diacid, (S)-	119427-28-0	Contains (regardless of intentional or impurities)	chemical products
20616	Difenconazole	119446-68-3	1%	chemical products
20617	Chromate(3-), bis[3-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-7-[[2-oxo-1-(phenylamino)carbonyl]propyl]azo]-2-naphthalenesulfonato(3-)]-, trisodium	119535-63-6	Contains (regardless of intentional or impurities)	chemical products
20618	Gallium arsenide phosphide (GaAs0.37P0.63)	119536-09-3	1,000ppm	chemical products
20619	Quinolinium, 1-ethyl-4-[2-(2-hydroxyphenyl)ethenyl]-, iodide, compound with (S)-3-(1-methyl-2-pyrroliidinyl)pyridine (1:1)	119543-59-8	Contains (regardless of intentional or impurities)	chemical products
20620	Quinolinium, 2-[2-[[2,4-dihydroxyphenyl]ethenyl]-1-ethyl-, iodide, compound with (S)-3-(1-methyl-2-pyrroliidinyl)pyridine (1:1)	119543-61-2	Contains (regardless of intentional or impurities)	chemical products
20621	Quinolinium, 1-ethyl-2-[2-(4-hydroxyphenyl)ethenyl]-, iodide, compound with (S)-3-(1-methyl-2-pyrroliidinyl)pyridine (1:1)	119543-62-3	Contains (regardless of intentional or impurities)	chemical products
20622	Quinolinium, 1-ethyl-2-[2-(2-hydroxyphenyl)ethenyl]-, iodide, compound with (S)-3-(1-methyl-2-pyrroliidinyl)pyridine (1:1)	119543-63-4	Contains (regardless of intentional or impurities)	chemical products
20623	Pyridinium, 1-ethyl-2-[2-(2-hydroxyphenyl)ethenyl]-, iodide, compound with (S)-3-(1-methyl-2-pyrroliidinyl)pyridine (1:1)	119543-64-5	Contains (regardless of intentional or impurities)	chemical products
20624	3-Pyridinol, 2,6-dinitro-, compound with strychnine, nitrate	119569-79-8	Contains (regardless of intentional or impurities)	chemical products
20625	Barium titanium oxide (Ba1.01Ti0.03)	119575-13-2	Intentional addition	chemical products
20626	Gallium arsenide phosphide (GaAs0.45P0.55)	119576-03-3	1,000ppm	chemical products
20627	Bis(acetato-kappa.O)[7-chloro-1-cyclopropyl-6-fluoro-4-(oxo-kappa.O)-1,4-dihydro-3-quinolinecarboxylato-kappa.O]boron	119618-67-6	1%	chemical products
20628	Cobalt sulfide (Co0.93S)	119633-64-6	Intentional addition / 1%	chemical products
20629	Boron, [2-(acetyl-kappa.O)-2,3-dihydro-1H-naphtho[2,1-b]pyran-1-onato-kappa.O]difluoro-, (T-4)-	119634-42-3	1%	chemical products
20630	Cuprate(1-), [4-nitro-2-[[[29H.31H-phthalocyanin-C-yl-kappa.N29.kappa.N30.kappa.N31.kappa.N32]methyl]amino]carbonyl]benzoato(3-)]-, hydrogen	119636-57-6	Intentional addition / 1,000ppm	chemical products
20631	Barium niobium sodium oxide (Ba2Nb5NaO11)	119653-14-4	Intentional addition	chemical products
20632	Chromate(3-), [7-[[[aminohydroxyphenyl]azo]-3-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-2-naphthalenesulfonato(3-)]-[3-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-7-[[2-oxo-1-(phenylamino)carbonyl]propyl]azo]-2-naphthalenesulfonato(3-)]-, trisodium	119654-54-5	Contains (regardless of intentional or impurities)	chemical products
20633	Barium molybdenum oxide (BaMo6O10)	119667-37-7	Intentional addition / 1%	chemical products
20634	2-Propanoic acid, 4-(oxiranylmethoxy)butyl ester	119692-59-0	Contains (regardless of intentional or impurities)	chemical products
20635	Quizalofop-P-tefuryl	119738-06-6	Contains (regardless of intentional or impurities)	chemical products
20636	Sillicic acid (H2SiO3), manganese(2+) salt (4:3)	119739-23-0	1%	chemical products
20637	Dimethomorph-mancozeb mixture	119793-38-3	Contains (regardless of intentional or impurities)	chemical products
20638	Molybdenum silicide (MoSi2.2)	119801-14-8	1%	chemical products
20639	Molybdenum silicide (MoSi2.1)	119801-15-9	1%	chemical products
20640	Chromium lead oxide (Cr2Pb4O7)	119801-45-5	Contains (regardless of intentional or impurities)	chemical products
20641	Gallium arsenide phosphide (GaAs0.46P0.54)	119829-06-0	1,000ppm	chemical products
20642	Gallium arsenide phosphide (GaAs0.45P0.54)	119829-07-1	1,000ppm	chemical products
20643	Manganese oxide (MnO1.75)	119854-89-6	1%	chemical products
20644	Iron boride (Fe3B7)	119855-17-3	1%	chemical products
20645	Manganese oxide (MnO1.95)	119855-48-0	1%	chemical products
20646	Manganese oxide (MnO1.85)	119855-49-1	1%	chemical products
20647	Manganese oxide (MnO1.73)	119855-50-4	1%	chemical products
20648	Manganese oxide (MnO1.64)	119883-78-2	1%	chemical products
20649	Manganese oxide (MnO1.53)	119883-79-3	1%	chemical products
20650	Manganese oxide (MnO1.51)	119883-80-6	1%	chemical products
20651	Cobalt sulfide (Co0.48S0.54)	119920-13-7	Intentional addition / 1%	chemical products
20652	Manganese oxide (MnO1.92)	119941-86-5	1%	chemical products
20653	Methanesulfonate (S)-1-methylbutyl	119982-81-3	Contains (regardless of intentional or impurities)	chemical products
20654	Hexanedioic acid, 3,4-dihydroxy-, compound with strychnine (1:2)	120023-42-9	Contains (regardless of intentional or impurities)	chemical products
20655	Bis(N,N-dimethyl-N'-5H-pyrido[2,3-a]phenothiazin-5-ylidene-1,4-phenylenediamine)nickel(II) dipherchlorate	120045-16-1	Contains (regardless of intentional or impurities)	chemical products
20656	Epranol	120068-37-3	Contains (regardless of intentional or impurities)	chemical products
20657	Boron carbide (BC3-4)	120114-03-6	1%	chemical products
20658	Arsenic selenide (AsSe1.2)	120148-08-5	Contains (regardless of intentional or impurities)	chemical products
20659	Titanium boride (Ti11B9)	120149-44-2	1%	chemical products
20660	Arsenic selenide (AsSe1.1)	120149-75-9	Contains (regardless of intentional or impurities)	chemical products
20661	Arsenic selenide (AsSe1.31)	120149-76-0	Contains (regardless of intentional or impurities)	chemical products
20662	4-Carboxy-3-fluorophenylboronic acid	120153-08-4	1%	chemical products
20663	Nickel(II) acetylacetonate hydrate	120156-44-7	Contains (regardless of intentional or impurities)	chemical products
20664	Gallium arsenide phosphide (GaAs0.38P0.62)	120306-39-0	1,000ppm	chemical products
20665	Gallium arsenide phosphide (GaAs0.59P0.41)	120306-40-3	1,000ppm	chemical products
20666	Tetrabutylammonium butyltriethylborate	120307-06-4	Contains (regardless of intentional or impurities)	chemical products
20667	Xylopyranose, 1-phosphate, compound with strychnine (1:1), .beta.-D-	120334-15-8	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
20668	1-Dodecanilium, N-ethyl-2-hydroxy-N-(2-hydroxydodecyl)-N-methyl-, bis[8-amino-1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)	120418-78-2	Contains (regardless of intentional or impurities)	chemical products
20669	1-Dodecanilium, N-ethyl-2-hydroxy-N-(2-hydroxydodecyl)-N-methyl-, bis[1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphthalenolato(2-)]chromate(1-)	120418-79-3	Contains (regardless of intentional or impurities)	chemical products
20670	1-Tetradecanilium, N-ethyl-2-hydroxy-N-(2-hydroxytetradecyl)-N-methyl-, bis[1-[(5-chloro-2-hydroxyphenyl)azo]-2-naphthalenolato(2-)]chromate(1-)	120418-80-6	Contains (regardless of intentional or impurities)	chemical products
20671	1-Tetradecanilium, N-ethyl-2-hydroxy-N-(2-hydroxytetradecyl)-N-methyl-, bis[2-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]benzoato(2-)]chromate(1-)	120418-81-7	Contains (regardless of intentional or impurities)	chemical products
20672	3-Ethyl-2-[[3-ethylbenzoxazole-2(3H)-ylidene]imethyl]benzoxazole-3-ium p-toluenesulfonate	120499-50-5	Contains (regardless of intentional or impurities)	chemical products
20673	1-Tetradecanilium, N-ethyl-2-hydroxy-N-(2-hydroxytetradecyl)-N-methyl-, bis[1-[(2-hydroxy-4(or)5-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)	120522-64-7	Contains (regardless of intentional or impurities)	chemical products
20674	1-Dodecanilium, N-ethyl-2-hydroxy-N-(2-hydroxydodecyl)-N-methyl-, bis[2,4-dihydro-4-[(2-hydroxy-5(or)6-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	120522-66-9	Contains (regardless of intentional or impurities)	chemical products
20675	Chromium sodium oxide (Cr3NaO8O8)	120558-28-3	Intentional addition / 1,000ppm	chemical products
20676	1-Tetradecanilium, N-ethyl-2-hydroxy-N-(2-hydroxytetradecyl)-N-methyl-, bis[2,4-dihydro-4-[(2-hydroxy-5(or)6-nitrophenyl)azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]chromate(1-)	120573-95-7	Contains (regardless of intentional or impurities)	chemical products
20677	1-Dodecanilium, N-ethyl-2-hydroxy-N-(2-hydroxydodecyl)-N-methyl-, bis[1-[(2-hydroxy-4(or)5-nitrophenyl)azo]-2-naphthalenolato(2-)]chromate(1-)	120574-56-3	Contains (regardless of intentional or impurities)	chemical products
20678	2,12-Dioxabicyclo[11.2.2]heptadeca-13,15,16-triene-14-carboxylic acid, compound with strychnine	120579-55-7	Contains (regardless of intentional or impurities)	chemical products
20679	Barium titanium oxide (BaTi1.04O3)	120604-62-8	Intentional addition	chemical products
20680	Gallium arsenide phosphide (GaAs0.34P0.66)	120804-98-0	1,000ppm	chemical products
20681	Gallium arsenide phosphide (GaAs0.06P0.94)	120804-99-1	1,000ppm	chemical products
20682	Boron carbide (B0.87C0.13)	120806-21-5	1%	chemical products
20683	Boron carbide (B0.85C0.15)	120806-22-6	1%	chemical products
20684	Boron carbide (B0.82C0.18)	120806-23-7	1%	chemical products
20685	Caronic acid, compound with strychnine (1:2)	120858-00-6	Contains (regardless of intentional or impurities)	chemical products
20686	Copper, [29H.31H-phthalocyaninato(2-)-N29.N30.N31.N32]-, chlorosulfonyl derivatives, reaction products with 2-[[4-aminophenyl)sulfonyl]ethyl hydrogen sulfate monosodium salt and ammonia, saponified, sodium salts	120883-69-4	Intentional addition / 1,000ppm	chemical products
20687	2,2-Biphenylsulfonic acid, 4,4',6,6'-tetramethyl-, compound with strychnine (1:2)	120883-94-5	Contains (regardless of intentional or impurities)	chemical products
20688	Molybdenum zinc oxide (MoZn2O7)	120922-80-7	Intentional addition / 1%	chemical products
20689	Benzenesulfonic acid, C14-24-branched and linear alkyl derivatives, barium salts, overbased	120968-17-4	Intentional addition / 1,000ppm	chemical products
20690	Manganese, [[1,2-ethanedylbis(carbamodithioato)](2-)]-, mixture with O,S-dimethylacetylphosphoramidithioate, [[1,2-ethanedylbis(carbamodithioato)](2-)]zinc and sulfur	120973-15-1	Contains (regardless of intentional or impurities)	chemical products
20691	(3,3-Dimethyl-1-butynyl)boronic acid diisopropyl ester	121021-24-7	1%	chemical products
20692	1-Naphthalenesulfonic acid, 2-[[2-hydroxy-6-sulfo-1-naphthalenyl)azo]-, barium salt (1:1)	121029-07-0	Contains (regardless of intentional or impurities)	chemical products
20693	1-Naphthalenesulfonic acid, 4-[[2-hydroxy-1-naphthalenyl)azo]-, barium salt (2:1)	121029-08-1	Contains (regardless of intentional or impurities)	chemical products
20694	Cuprate(2-), [5-[[4-[5-[[2,6-dihydroxy-3-[[2-hydroxy-5-sulfonylphenyl)azo]phenyl)azo]-1H-benzimidazol-2-yl]phenyl)azo]-2-hydroxybenzoato(4-)]-, disodium	121029-09-2	Intentional addition / 1,000ppm	chemical products
20695	Electrolytes, cobalt-manufacturing	121053-28-9	Intentional addition / 100ppm	chemical products
20696	Slimes and Sludges, cobalt refining (A complex combination of insoluble compounds resulting from cobalt processing-other than electrolytic.)	121053-29-0	Intentional addition / 1%	chemical products
20697	Slimes and Sludges, cobalt electrolytic (A complex combination of insoluble compounds either resulting from or formed during nickel electrolytic refining.)	121053-30-3	Contains (regardless of intentional or impurities)	chemical products
20698	Flue dust, nickel-refining	121053-32-5	Contains (regardless of intentional or impurities)	chemical products
20699	Slags, nickel-refining	121053-33-6	Contains (regardless of intentional or impurities)	chemical products
20700	Slimes and Sludges, nickel refining (A complex combination of insoluble compounds resulting from nickel processing-other than electrolytic.)	121053-36-9	Contains (regardless of intentional or impurities)	chemical products
20701	3-Formyl-4-methoxyphenylboronic acid	121124-97-8	1%	chemical products
20702	Copper, [29H.31H-phthalocyaninato(2-)-N29.N30.N31.N32]-, aminosulfonyl [[3-[[[3,6-dichloro-4-pyridazinyl]carbonyl]amino]-4-methyl-5-sulfonyl]amino]sulfonyl sulfo derivatives, sodium salts	121176-52-1	Intentional addition / 1,000ppm	chemical products
20703	4-Amylphenylboronic acid	121219-12-3	1%	chemical products
20704	Boronic acid, B-(2,3-difluorophenyl)-	121219-16-7	1%	chemical products
20705	3-Butyl-2-[5-(3-butyl-1,1-dimethyl-1H-benzo[e]indol-2(3H)-ylidene)pentane-1,3-dienyl]-1,1-dimethyl-1H-benzo[e]indolinium perchlorate	121482-73-3	1,000ppm	chemical products
20706	Acetic acid, (4-methoxy-1-naphthylsulfanyl)-, compound with strychnine	121499-75-0	Contains (regardless of intentional or impurities)	chemical products
20707	2-Thiopheneglycolic acid, compound with strychnine	121526-88-3	Contains (regardless of intentional or impurities)	chemical products
20708	Hydrotraptic acid, strychnine salt	121527-65-9	Contains (regardless of intentional or impurities)	chemical products
20709	Zirconium, [P,P'-bis[2,2-bis(2-(2-propenyloxy)methyl)butyl] diphosphato(2-)-O,O']bis[2,2-bis(2-(2-propenyloxy)methyl)-1-butanolato-O,1O2]-	121543-39-3	Contains (regardless of intentional or impurities)	chemical products
20710	Caronic acid, compound with strychnine (1:1)	121543-62-2	Contains (regardless of intentional or impurities)	chemical products
20711	Propiolic acid, compound with strychnine	121543-86-0	Contains (regardless of intentional or impurities)	chemical products
20712	Boronic acid, B-(4-(4-pentyl,1,1'-biphenyl)-4-yl)-	121554-18-5	1%	chemical products
20713	Pitch, coal tar, high-temperature, heat-treated	121575-60-8	Contains (regardless of intentional or impurities)	chemical products
20714	1,1-Dichloro-1,3-difluoropropane	121612-64-4	Intentional addition	chemical products
20715	3-Chloro-1,1,2-trifluoropropane	121612-65-5	Intentional addition	chemical products
20716	Distillates (coal tar), benzole fraction, distillation residues	121620-46-0	Contains (regardless of intentional or impurities)	chemical products
20717	Extract residues (coal), naphthalene oil, alkaline	121620-47-1	Contains (regardless of intentional or impurities)	chemical products
20718	Extract residues (coal), naphthalene oil, alkaline, naphthalene-low	121620-48-2	Contains (regardless of intentional or impurities)	chemical products
20719	1-Allyl-3-chloro-4-fluorobenzene	121626-73-1	Contains (regardless of intentional or impurities)	chemical products
20720	alpha-D-Xylopyranose, 1-phosphate, salt with strychnine (1:2)	121707-90-2	Contains (regardless of intentional or impurities)	chemical products
20721	Titanium boride (TiB1.6-3.2)	121833-97-4	1%	chemical products
20722	Titanium boride (TiB1.6)	121833-98-5	1%	chemical products
20723	Cyhalofop-butyl	122008-85-9	Intentional addition / 1%	chemical products
20724	Phenanthrene, distillation residues	122070-78-4	Contains (regardless of intentional or impurities)	chemical products
20725	Extract oils (coal), coal tar residual pyrolysis oils, naphthalene oils	122070-79-5	Contains (regardless of intentional or impurities)	chemical products
20726	Extract oils (coal), coal tar residual pyrolysis oils, naphthalene oil, distillation residues	122070-80-8	Contains (regardless of intentional or impurities)	chemical products
20727	beta-D-Xylopyranose, 1-phosphate, salt with strychnine	122147-77-7	Contains (regardless of intentional or impurities)	chemical products
20728	alpha-D-Xylopyranose, 1-phosphate, salt with strychnine	122147-78-8	Contains (regardless of intentional or impurities)	chemical products
20729	Copper selenide (Cu1.95-1.99Se)	122163-00-2	Contains (regardless of intentional or impurities)	chemical products
20730	Cuprate(4-), [2-[[[2-hydroxy-3-sulfo-5-[[2-(sulfooxy)ethyl)sulfonyl]phenyl)azo]phenylmethyl)azo]-4-sulfobenzoato(6-)]-, tetrahydrogen	122284-73-5	Intentional addition / 1,000ppm	chemical products
20731	Gallium arsenide phosphide (GaAs0.7-1P0-0.3)	122285-88-5	1,000ppm	chemical products
20732	Lithium molybdenum oxide (Li0.3Mo2O4)	122310-32-1	1%	chemical products
20733	Lithium molybdenum oxide (Li0.9-1.1Mo2O4)	122310-33-2	1%	chemical products
20734	Molybdenum sodium oxide (Mo2Na-1.4O4)	122310-34-3	1%	chemical products
20735	Gallium arsenide phosphide (GaAs0.26P0.74)	122326-17-4	1,000ppm	chemical products
20736	Boron nitride (B0.5-1N0-0.5)	122326-45-8	1%	chemical products
20737	Boron nitride (B0.56N0.44)	122326-46-9	1%	chemical products
20738	[1,1'-Bis(naphthalene)-2,2'-disulfonic acid, compound with strychnine (1:2)	122361-60-8	Contains (regardless of intentional or impurities)	chemical products
20739	Acetamide, N-[2-[(4-chloro-3-cyano-5-formyl-2-thienyl)azo]-5-(diethylamino)phenyl]-2-methoxy-	122371-93-1	Contains (regardless of intentional or impurities)	chemical products
20740	Extract residues (coal), cressote oil acid	122384-77-4	Contains (regardless of intentional or impurities)	chemical products
20741	Extract residues (coal), low temperature coal tar alkaline	122384-78-5	Contains (regardless of intentional or impurities)	chemical products
20742	Poly(oxy-1,2-ethanediyl), alpha-(4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,11-heptaecafluoro-2-hydroxyundecyl)-omega-[[4,4,5,5,6,6,7,7,8,8,9,9,10,10,11,11,11-heptaecafluoro-2-hydroxyundecyl)oxy]-	122402-79-3	Intentional addition / 100ppm	chemical products
20743	Europium vanadium yttrium oxide phosphate	122434-46-2	Intentional addition / 1%	chemical products
20744	Chlorfenapyr	122453-73-0	Contains (regardless of intentional or impurities)	chemical products
20745	Ferrate(2-), [[N,N'-1,3-propanediylbis[N-(carboxymethyl)glycinato]](4-)-N,N',O,O',ON,ON]-, (OC-6-21)-	122489-39-8	1%	chemical products
20746	Barium titanium oxide (Ba0.99Ti0.299)	122498-13-9	Intentional addition	chemical products
20747	2-[1-(4-Aminophenyl)ethylidene]malononitrile	122520-80-3	Contains (regardless of intentional or impurities)	chemical products
20748	Glycine, N,N'-1,2-ethanedylbis- chromium complex, compound with strychnine	122564-98-1	Contains (regardless of intentional or impurities)	chemical products
20749	Copper selenide (Cu1.94Se)	122572-70-7	Contains (regardless of intentional or impurities)	chemical products
20750	Copper selenide (Cu1.74-1.95Se)	122572-71-8	Contains (regardless of intentional or impurities)	chemical products
20751	Boron carbide (B4O2C)	122574-96-3	1%	chemical products
20752	Strychnidin-10-one, mono[OC-6-13-O-(R-(R,R*))]-[[N,N'-1,2-ethanedylbis(glycinato)](2-)-N,N',O,O']propanedioate(2-)-O,O']chromate(1)	122619-87-8	Contains (regardless of intentional or impurities)	chemical products
20753	2-(5-Fluoro-2,4-dinitrophenoxy) butyl acetate	122641-49-0	1%	chemical products
20754	1,3,5-Triazine-2,4,6-(1H,3H,5H)-trione, compound with (S)-3-[(1-methyl-2-pyrroldinyl)pyridine	122659-59-5	Contains (regardless of intentional or impurities)	chemical products
20755	Androst-5-en-18-oiic acid, 17.beta-(carboxycarbonyl)acetyl)-11.beta.-hydroxy-3-oxo-, gamma.-lactone, cyclic 3-(ethylene acetal), compound with strychnine	122764-64-1	Contains (regardless of intentional or impurities)	chemical products
20756	3,4-Dimethoxyphenylboronic acid	122775-35-3	1%	chemical products
20757	Manganese oxide (Mn0.98O)	122790-38-9	1%	chemical products
20758	Manganese oxide (Mn0.94O)	122790-39-0	1%	chemical products
20759	Phenol, 4-(1,3-dimethylheptyl)-	122961-18-6	Intentional addition / 1%	chemical products
20760	Copper boride (Cu3B)	122996-62-7	Intentional addition / 1,000ppm	chemical products
20761	3H-Indolium, 1-heptyl-2-[5-(1-heptyl-1,3-dihydro-3,3-dimethyl-2H-indol-2-ylidene)-1,3-pentadienyl]-3,3-dimethyl-, (T-4)-butyltriphenylborate(1-)	123051-21-8	1%	chemical products
20762	4-Aminocarbonylphenylboronic acid	123088-59-5	1%	chemical products
20763	Molybdenum sodium oxide (Mo7Na2O22)	123114-47-6	1%	chemical products
20764	Isocitonic acid, pentaecafluoro-	123116-17-6	1,000ppm	chemical products
20765	Strychnidin-10-one, mono[O-(R)-[[2-(methoxyphenyl)sulfinyl]acetate]	123121-12-0	Contains (regardless of intentional or impurities)	chemical products
20766	Butanoic acid, 2,2-diethyl-, barium salt	123133-86-8	Intentional addition / 1,000ppm	chemical products
20767	Pentanoic acid, 2,2-dipropyl-, barium salt	123133-87-9	Intentional addition / 1,000ppm	chemical products
20768	Molybdenum vanadium hydroxide oxide phosphate (Mo11.1V0.9(OH)3.9O32.1(PO4))	123142-20-1	1%	chemical products
20769	Molybdenum vanadium hydroxide oxide phosphate (Mo10.14V1.86(OH)4.86O31.14(PO4))	123142-21-2	1%	chemical products
20770	Molybdenum vanadium hydroxide oxide phosphate (Mo9.37V2.63(OH)5.63O30.37(PO4))	123142-22-3	1%	chemical products
20771	Aluminum barium europium magnesium oxide	123243-59-4	Intentional addition	chemical products
20772	Strychnidin-10-one, mono[(-)-bromochloroacetate]	123266-76-2	Contains (regardless of intentional or impurities)	chemical products
20773	Strychnidin-10-one, mono[(+)-bromochloroacetate]	123289-26-9	Contains (regardless of intentional or impurities)	chemical products
20774	Pentachlorophenol, sodium salt hydrate	123333-54-0	Contains (regardless of intentional or impurities)	chemical products
20775	Chromium(III) fluoride tetrahydrate	123333-98-2	1,000ppm	chemical products
20776	Tetraethyl arsonium chloride hydrochloride	123334-18-9	Intentional addition / 1%	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
20777	Vanadium_oxo[sulfato(2-)-O]- hydrate	123334-20-3	Intentional addition / 1%	chemical products
20778	Trifluoro(2-methoxy-2-methylpropane)boron	123334-27-0	1%	chemical products
20779	Cobalt(II) acetylacetonate hydrate	123334-29-2	Intentional addition / 1%	chemical products
20780	Strychnidin-10-one, mono.alpha.-hydroxybenzeneacetate)	123457-64-7	Contains (regardless of intentional or impurities)	chemical products
20781	Strychnidin-10-one, mono.alpha.-oxobenzeneacetate)	123468-24-6	Contains (regardless of intentional or impurities)	chemical products
20782	Nickel oxide (Ni64O)	123516-73-4	Contains (regardless of intentional or impurities)	chemical products
20783	Nickel oxide (Ni8O)	123516-74-5	Contains (regardless of intentional or impurities)	chemical products
20784	Copper selenide (Cu1.81Se)	123517-16-8	Contains (regardless of intentional or impurities)	chemical products
20785	Copper selenide (Cu1.82Se)	123517-17-9	Contains (regardless of intentional or impurities)	chemical products
20786	Barium titanium oxide (BaO.16TlO.2300.61)	123517-47-9	Intentional addition	chemical products
20787	Barium titanium oxide (BaO.02TiO.3800.6)	123550-60-5	Intentional addition	chemical products
20788	Barium titanium oxide (BaO.46TiO.0200.5)	123550-69-6	Intentional addition	chemical products
20789	Barium titanium oxide (BaO.54TiO.0900.37)	123550-70-9	Intentional addition	chemical products
20790	Barium titanium oxide (BaO.05TiO.4500.5)	123550-71-0	Intentional addition	chemical products
20791	Cuprate(2-), [7-[(5-chloro-2,6-difluoro-4-pyrimidinylamino)-4-hydroxy-3-[[2-[(2-hydroxy-5-sulfonylphenyl)azo]-4,5-dimethoxyphenyl]azo]-2-naphthalenesulfonato(4-)]-] disodium	123571-07-3	Intentional addition / 1,000ppm	chemical products
20792	Manganese, [[1,2-ethanediybis[carbamodithioato]](2-)]-, mixture with N-(cyano-2-thienylmethyl)-2,4-diethyl-5-thiazolecarboxamide and [[1,2-ethanediybis[carbamodithioato]](2-)]zinc.	123615-79-2	Contains (regardless of intentional or impurities)	chemical products
20793	Manganese, [[1,2-ethanediybis[carbamodithioato]](2-)]-, mixture with O,O-diethyl [2-(dipropylamino)-2-oxoethyl]ethylphosphoramidothioate, [[1,2-ethanediybis[carbamodithioato]](2-)]zinc and N,N'-[1,4-piperazinediybis(2,2,2-trichloroethylidene)]bis[formamide]	123615-95-2	Contains (regardless of intentional or impurities)	chemical products
20794	Manganese, [[1,2-ethanediybis[carbamodithioato]](2-)]-, mixture with O,O-diethyl [2-(dipropylamino)-2-oxoethyl]ethylphosphoramidothioate and [[1,2-ethanediybis[carbamodithioato]](2-)]zinc	123616-02-4	Contains (regardless of intentional or impurities)	chemical products
20795	Zirconium boride (ZrB0.6)	123627-59-8	Contains (regardless of intentional or impurities)	chemical products
20796	Zirconium boride (ZrB1.4)	123627-60-1	Contains (regardless of intentional or impurities)	chemical products
20797	Zirconium boride (ZrB1.9)	123627-61-2	Contains (regardless of intentional or impurities)	chemical products
20798	Zirconium boride (ZrB1.8)	123627-62-3	Contains (regardless of intentional or impurities)	chemical products
20799	Zirconium boride (ZrB1.7)	123627-63-4	Contains (regardless of intentional or impurities)	chemical products
20800	Gallium arsenide phosphide (GaAs0.71P0.29)	123627-64-5	1,000ppm	chemical products
20801	Manganese, [[1,2-ethanediybis[carbamodithioato]](2-)]-, mixture with N-(cyano-2-furanyl-methyl)-2,4-diethyl-5-thiazolecarboxamide and [[1,2-ethanediybis[carbamodithioato]](2-)]zinc	123633-91-0	Contains (regardless of intentional or impurities)	chemical products
20802	Barium silicon oxide (Ba0.35Si0.65O)	123646-69-5	Intentional addition	chemical products
20803	Barium silicon oxide (Ba0.13Si0.87O)	123646-70-8	Intentional addition	chemical products
20804	Manganese, [[1,2-ethanediybis[carbamodithioato]](2-)]-, mixture with N-(1-cyano-3-methyl-2-butenyl)-4-ethyl-2-methyl-5-thiazolecarboxamide and [[1,2-ethanediybis[carbamodithioato]](2-)]zinc	123713-29-1	Contains (regardless of intentional or impurities)	chemical products
20805	Cuprate(2-), [7-[(5-chloro-2,6-difluoro-4-pyrimidinylamino)-4-hydroxy-3-[[2-[(2-hydroxy-5-sulfonylphenyl)azo]-4,5-dimethoxyphenyl]azo]-2-naphthalenesulfonato(4-)]-] lithium sodium	123754-25-6	Intentional addition / 1,000ppm	chemical products
20806	1.alpha.-Cyclohexanecarboxylic acid, 3.alpha.,4.alpha.,5.alpha.-trihydroxy, compound with strychnine (1:1)	123807-71-6	Contains (regardless of intentional or impurities)	chemical products
20807	Strychnine, compound with 4,4a,4b,5,6,7,8,8a,9,10-decahydro-5,8-dihydroxy-4amethyl-2(3H)-phenanthrone acid phthalate	123937-38-2	Contains (regardless of intentional or impurities)	chemical products
20808	Glycine, N-(phenylsulfonyl)-N-(2,4,6-trimethyl-3-pyridyl)-, strychnine salt	123937-46-2	Contains (regardless of intentional or impurities)	chemical products
20809	1,2-Dithiepane-3,7-dicarboxylic acid, compound with strychnine	124108-56-1	Contains (regardless of intentional or impurities)	chemical products
20810	Phthalic acid, alpha-ethyl-p-(p-methoxyphenyl)benzyl ester, strychnine salt	124136-47-6	Contains (regardless of intentional or impurities)	chemical products
20811	Boron nitride (B0.6-0.9N0.1-0.4)	124205-69-2	1%	chemical products
20812	Copper selenide (Cu1.91Se)	124205-86-3	Contains (regardless of intentional or impurities)	chemical products
20813	Flue dust, cobalt-refining	124222-14-6	Intentional addition / 1%	chemical products
20814	Residues, cobalt-refining	124222-15-7	Contains (regardless of intentional or impurities)	chemical products
20815	Residues, copper-refining	124222-16-8	Contains (regardless of intentional or impurities)	chemical products
20816	Residues, nickel-refining	124222-17-9	Contains (regardless of intentional or impurities)	chemical products
20817	Residues, precious metal-refining	124222-18-0	Contains (regardless of intentional or impurities)	chemical products
20818	Slimes and Sludges, nickel electrolytic (A complex combination of insoluble compounds either resulting from or formed during nickel electrolytic refining.)	124222-19-1	Contains (regardless of intentional or impurities)	chemical products
20819	Molybdenum silicide (MoSi3.35)	124230-17-7	1%	chemical products
20820	Ferrate(1-), [[N,N'-1,3-propanediybis[N-(carboxymethyl)glycinato]](4-)-N,N',O,O',ON,ON]-, potassium, (OC-6-21)-	124268-99-1	1%	chemical products
20821	Ferrate(1-), [[N,N'-1,3-propanediybis[N-(carboxymethyl)glycinato]](4-)-N,N',O,O',ON,ON]-, sodium, (OC-6-21)-	124269-00-7	1%	chemical products
20822	Formaldehyde, polymer with 2,7-naphthalenediol	124303-57-7	1%	chemical products
20823	Lanthanum boride (LaB5.74)	124304-90-1	1%	chemical products
20824	Lanthanum boride (LaB5.86)	124304-91-2	1%	chemical products
20825	Lanthanum boride (LaB6.09)	124304-92-3	1%	chemical products
20826	Lanthanum boride (LaB5.74-6.09)	124304-95-6	1%	chemical products
20827	Slags, copper-refining	124316-01-4	Intentional addition / 1,000ppm	chemical products
20828	Zirconium, bis[2,2-bis[(2-propenyloxy)methyl]-1-butanolato-O1,O2]bis[3-mercaptopropanoato-O)-	124319-53-5	Contains (regardless of intentional or impurities)	chemical products
20829	Aluminum, (N,N-dimethylethanamine)trihydro-, (T-4)-	124330-23-0	1%	chemical products
20830	(2R)-1-(6-Amino-2,3-difluorophenyl)-2-propanol	124409-98-9	Contains (regardless of intentional or impurities)	chemical products
20831	Titanium boride (Ti4B)	124423-20-7	1%	chemical products
20832	Stannane, tricyclohexyl[[[dipropylamino]thioxomethyl]thio]-	124504-99-0	Contains (regardless of intentional or impurities)	chemical products
20833	Stannane, tricyclohexyl[[[diethylamino]thioxomethyl]thio]-	124505-02-8	Contains (regardless of intentional or impurities)	chemical products
20834	Aluminum molybdenum oxide (AlO-2Mo0-1O3)	124545-31-9	1%	chemical products
20835	Molybdenum carbide (Mo3C4)	124545-85-3	1%	chemical products
20836	Molybdenum carbide (Mo0.9C)	124567-52-8	1%	chemical products
20837	Molybdenum carbide (MoC0.7)	124567-53-9	1%	chemical products
20838	Gallium arsenide phosphide (GaAs0.39P0.61)	124588-15-4	1,000ppm	chemical products
20839	Copper bis(sulfamate) tetrahydrate	124594-13-4	Intentional addition / 1,000ppm	chemical products
20840	Nickel(II) bis(sulfamate) tetrahydrate	124594-15-6	Contains (regardless of intentional or impurities)	chemical products
20841	Boron nitride (BN0-1)	124697-00-3	1%	chemical products
20842	Barium titanium oxide (BaTi3.8-4.2O8.6-9.4)	124697-11-6	Intentional addition	chemical products
20843	C.1 Basic Blue 163	124719-24-0	Contains (regardless of intentional or impurities)	chemical products
20844	Nickel boride (Ni5B2)	124747-65-5	Contains (regardless of intentional or impurities)	chemical products
20845	Resin acids and Rosin acids, fumarated, barium salts	124751-15-1	Intentional addition / 1,000ppm	chemical products
20846	Boric acid (H3BO3), compound with 2-(2-aminoethoxy)ethanol (1:1)	124756-59-8	1%	chemical products
20847	1-Propanesulfonic acid, 3-hydroxy-, nickel(2+) salt (2:1)	124827-66-3	Contains (regardless of intentional or impurities)	chemical products
20848	3-Butyl-2-[5-(1-butyl-3,3-dimethylindol-2(3H)-ylidene)pentane-1,3-dienyl]-1,1-dimethyl-1H-benzo[e]indolinium perchlorate	124904-42-3	1,000ppm	chemical products
20849	Manganese oxide (MnO1.97)	124923-56-4	1%	chemical products
20850	Zirconium, chloro L-cysteine hydroxy propylene glycol aluminum complexes	124945-51-3	Contains (regardless of intentional or impurities)	chemical products
20851	Boric acid, reaction products with butyl alcohol and succinic anhydride polybutenyl derivative-tetraethylenepentamine reaction product	125025-86-7	1%	chemical products
20852	beta-Alanine aluminum zirconium complex	125046-23-3	Contains (regardless of intentional or impurities)	chemical products
20853	Sulfonate, (thiodi-4,1-phenylene)bis[bis[4-(2-hydroxyethoxy)phenyl]-, bis[(OC-11-6)-]hexafluoroantimonate(1-)]	125054-47-9	Contains (regardless of intentional or impurities)	chemical products
20854	Calcium molybdenum oxide (Ca1.24Mo1.01O3)	125124-08-5	1%	chemical products
20855	1-Azabicyclo[2.2.2]octane-4-carbonitrile, 1/2 sulfate salt	125185-59-3	Intentional addition	chemical products
20856	Chromium copper oxide ((Cr,Cu)3O4)	125233-42-3	Intentional addition / 1,000ppm	chemical products
20857	Cobaltate(1-), bis[4-hydroxy-3-[(2-hydroxy-1-naphthalenyl)azo]benzenesulfonamidato(2-)]-, lithium	125252-57-5	Intentional addition / 1,000ppm	chemical products
20858	Barium niobium sodium oxide (Ba2NbNaO5)	125270-44-2	Intentional addition	chemical products
20859	Cobalt oxide (Co0-1O)	125271-30-9	Intentional addition / 1%	chemical products
20860	Nickelate(1-), (formato-O)[sulfato(2-)-O]-, hydrogen	125275-86-7	Contains (regardless of intentional or impurities)	chemical products
20861	Nickelate(1-), (acetato-O)[sulfato(2-)-O]-, hydrogen	125275-87-8	Contains (regardless of intentional or impurities)	chemical products
20862	Chromium lanthanum oxide (CrLa0.99O3)	125297-07-6	Intentional addition / 1,000ppm	chemical products
20863	Benzenesulfonic acid, C10-13-alkyl derivatives	125301-81-7	1%	chemical products
20864	Cuprate(3-), [mu-3-[[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-7-[[[5-hydroxy-6-[(2-hydroxy-5-sulfonylphenyl)azo]-7-sulfo-2-naphthalenylamino]carbonylamino]-2-naphthalenesulfonato(7-)]]di-, trisodium	125302-01-4	Intentional addition / 1,000ppm	chemical products
20865	Ferrate(1-), bis[4-[[6-chloro-2-hydroxyphenyl]azo]-3-hydroxy-N-phenyl-2-naphthalenecarboxamidato(2-)]-, sodium	125304-21-4	1%	chemical products
20866	N,N-Diethyl-3-(2,4,6-trimethylphenylsulfonyl)-1H-1,2,4-triazole-1-carboxamide	125306-83-4	1%	chemical products
20867	Manganese, isobutyl dimethyl phosphate isooctanoate neodecanoate complexes	125328-27-0	Contains (regardless of intentional or impurities)	chemical products
20868	Fatty acids, C4-20-branched, cobalt salts	125328-48-5	Intentional addition / 1%	chemical products
20869	Fatty acids, C4-20-branched, manganese salts	125328-50-9	Contains (regardless of intentional or impurities)	chemical products
20870	Fatty acids, C4-20-branched, zirconium salts	125328-52-1	Contains (regardless of intentional or impurities)	chemical products
20871	9-Octadecenoic acid (2Z)-, polymer with copper(2+) sulfate (1:1), 2,5-furandione and oxybis[propanol]	125329-08-0	Intentional addition / 1,000ppm	chemical products
20872	Cobaltate(3-), bis[2-[[[4-hydroxy-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]phenyl]sulfonylamino]benzoato(3-)]-], ammonium sodium	125352-02-5	Intentional addition / 1%	chemical products
20873	Cobaltate(2-), [2-[[[4-hydroxy-3-[[2-oxo-1-[[phenylamino]carbonyl]propyl]azo]phenyl]sulfonylamino]benzoato(3-)]-]]2-[[2-hydroxy-5-[[phenylamino]sulfonyl]propyl]azo]-3-oxo-N-phenylbutanamidato(2-)]-, ammonium sodium	125352-03-6	Intentional addition / 1%	chemical products
20874	Cuprate(3-), [mu-4-[[[3,3-dihydroxy-4-[[2-hydroxy-6-sulfo-1-naphthalenyl]azo][1,1'-biphenyl]-4-y]azo]-3-hydroxy-2,7-naphthalenedisulfonato(7-)]]di-, ammonium lithium sodium, compounds with diethanolamine	125352-04-7	Intentional addition / 1,000ppm	chemical products
20875	Sulfuric acid copper(2+) salt (1:1), polymer with 2,5-furandione and oxybis[propanol]	125352-10-5	Intentional addition / 1,000ppm	chemical products
20876	Nickelate(1-), [3-hydroxy-4-[[4-methyl-3-sulfonylphenyl]azo]-2-naphthalenecarboxylato(3-)]-, hydrogen	125378-87-2	Contains (regardless of intentional or impurities)	chemical products
20877	Cobaltate(2-), [1-[[[5-chloro-2-hydroxyphenyl]azo]-2-naphthalenolato(2-)]-]3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, disodium	125378-88-3	Intentional addition / 100ppm	chemical products
20878	Cobaltate(3-), bis[3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-, trisodium	125378-89-4	Intentional addition / 1,000ppm	chemical products
20879	Chromate(1-), bis[2,4-dinitro-6-[[2-(phenylamino)-1-naphthalenyl]azo]phenolato(2-)]-, sodium	125378-90-7	Contains (regardless of intentional or impurities)	chemical products
20880	Cobaltate(1-), bis[2,4-dinitro-6-[[2-(phenylamino)-1-naphthalenyl]azo]phenolato(2-)]-, sodium	125378-91-8	Intentional addition / 1,000ppm	chemical products
20881	Chromate(1-), bis[3-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-y]azo]-4-hydroxy-N-phenylbenzenesulfonamidato(2-)]-, sodium	125378-92-9	Contains (regardless of intentional or impurities)	chemical products
20882	Chromate(1-), bis[4-[[3,5-dichloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-2-phenyl-3H-pyrazol-3-onato(2-)]-, sodium	125378-93-0	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
20883	Chromate(1-), [1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-1-[(2-hydroxy-5-nitrophenyl)azo]-2-naphthalenolato(2-)]-, hydrogen, compound with N-cyclohexylcyclohexanamine (1:1)	125378-94-1	Contains (regardless of intentional or impurities)	chemical products
20884	Chromate(1-), bis[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenolato(2-)]-, hydrogen, compound with N-cyclohexylcyclohexanamine (1:1)	125378-95-2	Contains (regardless of intentional or impurities)	chemical products
20885	Zirconium, chloro hydroxy L-lysine propylene glycol aluminum complexes	125380-32-7	Contains (regardless of intentional or impurities)	chemical products
20886	Zirconium, chloro hydroxy propylene glycol L-serine aluminum complexes	125380-33-8	Contains (regardless of intentional or impurities)	chemical products
20887	Cobaltate(1-), bis[2-[(2-hydroxy-5-[(phenylamino)sulfonyl]phenyl)azo]-3-oxo-N-phenylbutanamidato(2-)]-, ammonium	125408-78-8	Intentional addition / 1,000ppm	chemical products
20888	Boron nitride (B0.5-0.6N0.4-0.5)	125431-77-8	1%	chemical products
20889	Borates(1-), butyltriphenyl-, magnesium chloride (1:1:1), (T-4)-	125441-82-1	1%	chemical products
20890	1,3,2,4-Dioxadiplobutanes, 2,4-dioxide	125454-11-7	Intentional addition / 1,000ppm	chemical products
20891	Manganese oxide (Mn3O4.78)	125485-71-6	1%	chemical products
20892	Manganese oxide (Mn3O4.75)	125485-79-4	1%	chemical products
20893	Beryllium oxide (BeO0.9)	125486-18-4	Contains (regardless of intentional or impurities)	chemical products
20894	Lubricating oils (petroleum), hydrotreated, used, distillation residues	125471-97-8	Contains (regardless of intentional or impurities)	chemical products
20895	Silicic acid (H4SiO4), disodium salt, reaction products with chlorotrimethylsilane and 3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10-heptafluorodecyl-1-decanol	125476-71-3	1,000ppm	chemical products
20896	Calcium molybdenum oxide (Ca16.5Mo13.5O40)	125483-96-7	1%	chemical products
20897	Gallium arsenide phosphide (GaAs0.97-0.99P0.01-0.03)	125484-17-5	1,000ppm	chemical products
20898	Gallium arsenide phosphide (GaAs0.01-0.03P0.97-0.99)	125484-18-6	1,000ppm	chemical products
20899	Iron, 1,3-dimethylbutyl dihydrogen phosphate 1,3-dimethylbutyl hydrogen phosphate 2-ethylhexanoate naphthenate complexes	125494-55-5	1%	chemical products
20900	Boric acid (H3BO3), cobalt(2+) salt (1:1)	125552-50-3	Intentional addition / 1%	chemical products
20901	Benzyl(4-hydroxyphenyl)methylsulfonium hexafluoroantimonate	125662-42-2	1,000ppm	chemical products
20902	Barium arsenite	125687-68-5	Contains (regardless of intentional or impurities)	chemical products
20903	Barium tantalum zinc zirconium oxide	125693-49-4	Contains (regardless of intentional or impurities)	chemical products
20904	Arsenic selenide (As0.15Se0.85)	125694-36-2	Contains (regardless of intentional or impurities)	chemical products
20905	Benzo[triazol-1-yl]-tetramethyluronium tetrafluoroborate	125700-67-6	1%	chemical products
20906	Dibenzo(b,e)(1,4)dioxin-13C12, 2,3,7,8-tetrabromo-	125749-35-1	Intentional addition / 100ppm	chemical products
20907	Cuprate(4-), [5-[(4-amino-6-chloro-1,3,5-triazin-2-yl)amino]-2-[[[(2-hydroxy-3,5-disulfonyl)phenyl]methyl]azo]benzoato(6-)]-, tetrahydrogen	125845-24-1	Intentional addition / 1,000ppm	chemical products
20908	Zirconium, adipate chloro hydroxy propylene glycol aluminum complexes	125904-14-5	Contains (regardless of intentional or impurities)	chemical products
20909	Zirconium, beta-alanine chloro hydroxy propylene glycol aluminum complexes	125904-15-6	Contains (regardless of intentional or impurities)	chemical products
20910	Zirconium, chloro hydroxy myristate propylene glycol aluminum complexes	125904-16-7	Contains (regardless of intentional or impurities)	chemical products
20911	Aluminum zirconium pentachlorohydroxy glycine complex	125913-22-6	Contains (regardless of intentional or impurities)	chemical products
20912	2,4-Hexadiyne, 1,6-diol, 1,1,6,6-tetraphenyl-, compound with (S)-3-(1-methyl-2-pyrrolidinyl)pyridine (1:1)	125947-48-0	Contains (regardless of intentional or impurities)	chemical products
20913	Phosphoric acid, mixed 3-bromo-2,2-dimethylpropyl and 2-bromoethyl and 2-chloroethyl esters	125997-20-8	Contains (regardless of intentional or impurities)	chemical products
20914	Molybdenum carbide (MoC4), (T-4)-	126214-49-1	1%	chemical products
20915	Molybdenum carbide (MoC0.83)	126282-62-0	1%	chemical products
20916	Boron nitride (BN0.95-0.98)	126345-68-4	1%	chemical products
20917	2-Amino-5-(2-chloro-4-nitrophenylazo)-4-methyl-3-thiophenecarbonitrile	126389-08-0	Contains (regardless of intentional or impurities)	chemical products
20918	1,4,2,3,5,6,7,8-Dithiahexaselenocane	126424-27-9	Contains (regardless of intentional or impurities)	chemical products
20919	1,3,2,4,5,6,7,8-Dithiahexaselenocane	126424-28-0	Contains (regardless of intentional or impurities)	chemical products
20920	1,5,2,3,4,6,7,8-Dithiahexaselenocane	126424-29-1	Contains (regardless of intentional or impurities)	chemical products
20921	1,4,2,3,5,6,7-Dithiapentaselenepane	126424-33-7	Contains (regardless of intentional or impurities)	chemical products
20922	Nicotine, bromocadmate	126425-22-7	Contains (regardless of intentional or impurities)	chemical products
20923	Nicotine, iodocadmate	126425-23-8	Contains (regardless of intentional or impurities)	chemical products
20924	Lithium molybdenum oxide (Li1-2MoO3)	126447-24-3	1%	chemical products
20925	Nicotine, tetraiodocadmate	126460-15-9	Contains (regardless of intentional or impurities)	chemical products
20926	Nicotine, tetrabromocadmate	126460-16-0	Contains (regardless of intentional or impurities)	chemical products
20927	Nicotine, pentaioferrate	126460-19-3	Contains (regardless of intentional or impurities)	chemical products
20928	Nicotine, pentachloroferrate	126460-20-6	Contains (regardless of intentional or impurities)	chemical products
20929	Ethanedioic acid, yttrium(3+) salt	126476-37-7	Intentional addition	chemical products
20930	Lithium molybdenum oxide (Li5Mo2O8)	126478-52-2	1%	chemical products
20931	Nicotine pentabromoferrate	126505-90-6	Contains (regardless of intentional or impurities)	chemical products
20932	Antimony tartrate	126506-93-2	Contains (regardless of intentional or impurities)	chemical products
20933	Gold sulfide	126549-44-8	Intentional addition	chemical products
20934	Strychnine hydrochloride sesquihydrate	126590-09-8	Contains (regardless of intentional or impurities)	chemical products
20935	Gallium arsenide phosphide (GaAs0.58P0.42)	126603-81-4	1,000ppm	chemical products
20936	Boron nitride (B1.25N)	126604-56-6	1%	chemical products
20937	Boron nitride (B5N)	126604-75-9	1%	chemical products
20938	Boron nitride (B8N)	126604-76-0	1%	chemical products
20939	Cuprate(4-), [mu-[[3,3'-[(3,3'-dihydroxy[1,1'-biphenyl]-4,4'-diyl)bis(azo)]bis[5-amino-4-hydroxy-2,7-naphthalenedisulfonato]](8-)]di-, dithium disodium	126637-70-5	Contains (regardless of intentional or impurities)	chemical products
20940	Cuprate(4-), [mu-3-[7-[[6-[[4-[(4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl)azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-1,5-dihydroxy-7-sulfo-2-naphthalenyl]azo]-8-hydroxy-1,3,6-naphthalenetrisulfonato(10-)]tri-, tetrapotassium	126637-71-6	Intentional addition / 1,000ppm	chemical products
20941	1-Dodecanesulfonic acid, barium salt	126660-36-4	Intentional addition	chemical products
20942	Isopropenylboronic acid pinacol ester	126726-62-3	1%	chemical products
20943	4-Cyanobenzeneboronic acid	126747-14-6	1%	chemical products
20944	Boron, aquatrifluoro-, (T-4)-	126757-08-2	1%	chemical products
20945	Benzenesulfonic acid, 2-hydroxy-, tin(2+) salt (2:1)	126857-67-8	1,000ppm	chemical products
20946	Strychnidin-10-one, mono[(OC-6-21-A)-[[N,N-(2-hydroxy-1,3-propanediyl)bis(N-(carboxymethyl)glycinato)](4-)]cobaltate(1-)], hydrate (2:3)	126924-31-0	Contains (regardless of intentional or impurities)	chemical products
20947	[Bis(2,6-diisopropylphenylimido)idichloro(1,2-dimethoxyethane)molybdenum (VI)]	126949-60-8	1%	chemical products
20948	Molybdenum, [2,6-bis(1-methylethyl)benzenaminato(2-)](1,2-dimethoxy-kappa.O)ethane(2-phenyl-2-phenylpropylidene)bis(1,1,1-trifluoromethanesulfonato-kappa.O)-, (OC-6-14)-	126949-63-1	1%	chemical products
20949	Arsenic selenide (As0.7Se0.3)	126999-21-1	Contains (regardless of intentional or impurities)	chemical products
20950	Nicotine tetraiodoferrate	127088-40-8	Contains (regardless of intentional or impurities)	chemical products
20951	Antimony oxide (Sb2O3), reaction products with talc	127153-81-5	Contains (regardless of intentional or impurities)	chemical products
20952	Iron boride (FeB)	127241-61-6	1%	chemical products
20953	Copper selenide (Cu1.83Se)	127242-58-4	Contains (regardless of intentional or impurities)	chemical products
20954	Copper selenide (Cu1.98-2Se)	127276-99-7	Contains (regardless of intentional or impurities)	chemical products
20955	Copper selenide (Cu1.77-1.83Se)	127277-00-3	Contains (regardless of intentional or impurities)	chemical products
20956	Chromium, 6(or 7)-amino-4-hydroxy-3-[(2-hydroxy-3,5-dinitrophenyl)azo]-2-naphthalenesulfonate-4-hydroxy-3-[(2-hydroxy-3,5-dinitrophenyl)azo]-6(or 7)-[(sulfomethyl)amino]-2-naphthalenesulfonate ammonium potassium sodium complexes	127278-99-3	1,000ppm	chemical products
20957	Residues, tin-refining	127279-03-2	Contains (regardless of intentional or impurities)	chemical products
20958	Molybdenum silicide (MoSi2.7)	127336-61-2	1%	chemical products
20959	Molybdenum silicide (MoSi2.4-3)	127336-64-5	1%	chemical products
20960	Antimony fluoride	127386-54-3	Contains (regardless of intentional or impurities)	chemical products
20961	Dichlorofluoropropane	127404-11-9	Intentional addition / 1,000ppm	chemical products
20962	Benzenepropanoic acid, 3-(2H-benzotriazol-2-yl)-5-(1,1-dimethylethyl)-4-hydroxy-, C7-9-branched and linear alkyl esters	127519-17-9	Contains (regardless of intentional or impurities)	chemical products
20963	Copper, [N-2-[[[4-(diethylamino)-6-fluoro-1,3,5-triazin-2-yl]oxy]ethyl]-N-(2-hydroxyethyl)-N'-[3-(1-methylethoxy)propyl]-2,9H,31H-phthalocyanine-C,C,O-trisulfonamidato(2-)-N29,N30,N31,N32]-	127542-87-4	Intentional addition / 1,000ppm	chemical products
20964	Tetrachlorodifluoropropane	127564-82-3	Intentional addition / 1,000ppm	chemical products
20965	Dichlorotetrafluoropropane	127564-83-4	Intentional addition / 1,000ppm	chemical products
20966	Trichlorodifluoropropane	127564-90-3	Intentional addition / 1,000ppm	chemical products
20967	Trichlorotetrafluoropropane	127564-91-4	Intentional addition / 1,000ppm	chemical products
20968	Dichloropentafluoropropane	127564-92-5	Intentional addition / 1,000ppm	chemical products
20969	Strychnine, complex with zinc thiocyanate	127620-33-1	Contains (regardless of intentional or impurities)	chemical products
20970	4-Nitrobenzyl (2S,4R)-2-(hydroxymethyl)-4-[(methylsulfonyl)oxy]-1-pyrrolidinecarboxylate	127626-37-3	Contains (regardless of intentional or impurities)	chemical products
20971	Platinum(2+) tetraaminediacetate	127733-97-5	Contains (regardless of intentional or impurities)	chemical products
20972	Gold selenide (Au2Se)	127764-45-8	Intentional addition / 1,000ppm	chemical products
20973	Ammonium arsenate	127795-79-3	Contains (regardless of intentional or impurities)	chemical products
20974	Molybdenum zinc oxide (Mo2Zn5O11)	127814-40-8	Intentional addition / 1%	chemical products
20975	Copper silver oxide	127814-43-1	Intentional addition / 1,000ppm	chemical products
20976	Copper DL-threo-beta-p-methylsulfonphenylserine	127822-02-0	Intentional addition / 1,000ppm	chemical products
20977	Chromate(3-), bis[3-hydroxy-4-[(2-hydroxy-1-naphthalenyl)azo]-7-nitro-1-naphthalenesulfonato(3-)]-, sodium dihydrogen	127851-78-9	Contains (regardless of intentional or impurities)	chemical products
20978	4-Chloro-3-ethyl-1-methyl-5-pyrazolecarboxylic acid	127892-62-0	Intentional addition	chemical products
20979	5-Formyl-2-methoxyphenylboronic acid	127972-02-5	1%	chemical products
20980	Bromofluoroethane	128035-10-9	Intentional addition / 1,000ppm	chemical products
20981	Gallium arsenide phosphide (GaAs0.05P0.95)	128089-50-9	1,000ppm	chemical products
20982	Cobalt lanthanum strontium	128090-06-2	Intentional addition / 1%	chemical products
20983	Silane, triethoxy[2-(tributylstanny)ethyl]-	128093-63-0	Contains (regardless of intentional or impurities)	chemical products
20984	Copper O,O-di(mixed 1-methylethyl, 1,3-dimethylbutyl)phosphorodithioate	128116-15-4	Intentional addition / 1,000ppm	chemical products
20985	3-(Methylthio)phenylboronic acid	128312-11-8	1%	chemical products
20986	4-Formylphenylboronic acid pinacol ester	128376-64-7	1%	chemical products
20987	Boronic acid, B-[1,1',3',1'-terphenyl]-5'-yl-	128388-54-5	1%	chemical products
20988	Boric acid (H3BO3), cobalt(2+) salt	128409-73-4	Intentional addition / 1%	chemical products
20989	Gallium arsenide phosphide (GaAs0.69P0.31)	128515-50-4	1,000ppm	chemical products
20990	Gallium arsenide phosphide (GaAs0.25-0.77P0.23-0.75)	128515-51-5	1,000ppm	chemical products
20991	Iron molybdenum oxide (Fe2Mo2.7O10.8)	128574-42-5	1%	chemical products
20992	Iron molybdenum oxide (Fe2Mo3.2O12.8)	128574-43-6	1%	chemical products
20993	Molybdenum hydroxide oxide phosphate (Mo5(OH)3O17(PO4))	128585-44-4	1%	chemical products
20994	Octane, 1,1,1,8,8,8-hexachloro-3,3,6,6-tetramethyl-	128600-85-1	1,000ppm	chemical products
20995	Nickel oxide (NiO0.7)	128607-90-9	Contains (regardless of intentional or impurities)	chemical products
20996	Nickel oxide (NiO0.3-0.7)	128607-91-0	Contains (regardless of intentional or impurities)	chemical products
20997	Nickel oxide (NiO0.1-0.8)	128607-92-1	Contains (regardless of intentional or impurities)	chemical products
20998	Strychnine, molybdarsenate	128662-88-4	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
20999	Strychnine_phosphomolybdate	128662-89-5	Contains (regardless of intentional or impurities)	chemical products
21000	Leach solutions, zinc refining	128704-79-0	Intentional addition / 1%	chemical products
21001	Chromium lanthanum oxide ((Cr,La)2O3)	128715-37-7	Intentional addition / 1,000ppm	chemical products
21002	Strychnine_complex with Co thiocyanate	128735-34-2	Contains (regardless of intentional or impurities)	chemical products
21003	Nicotine monohydrate	128758-70-3	Contains (regardless of intentional or impurities)	chemical products
21004	Cuprate(3-), [3-(hydroxy-kappa-O)-4-[2-[2-(hydroxy-kappa-O)-5-sulfophenyl]diazenyl-kappa-N1]-2,7-naphthalenedisulfonato(5-)]-, sodium (1:3)	128763-07-5	Intentional addition / 1,000ppm	chemical products
21005	1,2,3-Propanetriol, 1-ester with boric acid (H3BO3) (1:1)	128767-51-1	1%	chemical products
21006	1,2,3-Propanetriol, 2-ester with boric acid (H3BO3) (1:1)	128767-52-2	1%	chemical products
21007	Boric acid, B-[4-(trifluoromethyl)phenyl]-	128786-39-4	1%	chemical products
21008	2,2-Dichloro-1,1,1,3,3-pentafluoroisopropanol	128902-21-9	Intentional addition / 1,000ppm	chemical products
21009	Manganese oxide (Mn5O7)	128954-16-5	1%	chemical products
21010	Zinc phosphomolybdate (Zn3P2Mo24O41)	128975-01-9	Intentional addition / 1%	chemical products
21011	Chromium lead oxide (Cr2PbO4)	128976-28-3	Contains (regardless of intentional or impurities)	chemical products
21012	(E)-6-Chlorohex-2-ene	128984-47-4	Contains (regardless of intentional or impurities)	chemical products
21013	Strychnine_cyanocadmiate	129035-03-6	Contains (regardless of intentional or impurities)	chemical products
21014	2,5-Cyclohexadiene-1,4-dione, 2,3,5,6-tetrachloro-, compound with S-(3-(1-methyl-2-pyrrolidinyl)pyridine) (1:1)	129047-75-2	Contains (regardless of intentional or impurities)	chemical products
21015	Nickel sulfide (Ni7S8)	129188-37-0	Contains (regardless of intentional or impurities)	chemical products
21016	Nickel sulfide (NiO.59-0.63S0.37-0.41)	129188-38-1	Contains (regardless of intentional or impurities)	chemical products
21017	Nickel sulfide (NiO.58-0.58S0.42-0.44)	129188-39-2	Contains (regardless of intentional or impurities)	chemical products
21018	Molybdenum sodium oxide (MoNaO.23O3)	129208-42-0	1%	chemical products
21019	Molybdenum potassium oxide (Mo4KO6)	129209-03-6	1%	chemical products
21020	5-Azoniapropyl(4.4)nonane_tetrafluoroborate(1-)(1:1)	129211-47-8	Intentional addition / 1%	chemical products
21021	Cuprate(2-), [4-[[[2,4-dihydroxy-3-[[[4-nitrophenyl]azo]-5-[[[4-nitro-2-sulfophenyl]amino]phenyl]azo]phenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]]-, disodium	129212-10-8	Intentional addition / 1,000ppm	chemical products
21022	Benzenesulfonic acid, 5-[[2-hydroxy-1-naphthalenyl]azo]-2-methyl-, barium salt (2:1)	129212-12-0	Contains (regardless of intentional or impurities)	chemical products
21023	Benzenesulfonic acid, 5-chloro-4-methyl-2-[[1-[[[2-methylphenyl]amino]carbonyl]-2-oxopropyl]azo]-, barium salt (2:1)	129212-14-2	Contains (regardless of intentional or impurities)	chemical products
21024	Strychnine_molybdonitrate	129218-48-0	Contains (regardless of intentional or impurities)	chemical products
21025	Lanthanum boride (LaB3)	129235-97-8	1%	chemical products
21026	Molybdenum(2+), pentaaxodi-	129262-82-4	1%	chemical products
21027	Cuprate(2-), [7-amino-4-(hydroxy-kappa-O)-3-[[[2-[[2-(hydroxy-kappa-O)-5-sulfophenyl]azo-kappa-N1]-4,5-dimethoxyphenyl]azo-kappa-N1]-2-naphthalenesulfonato(4-)]]-, sodium hydrogen	129266-65-5	Intentional addition / 1,000ppm	chemical products
21028	1-(Phenylsulfonyl)-3-indoleboronic acid	129271-98-3	1%	chemical products
21029	(3S)-9,10-Difluoro-3-methyl-7-oxo-2,3-dihydro-7H-pyrido[1,2,3-de][1,4]benzoxazine-6-carboxylic acid difluoroboronium	129306-33-8	1%	chemical products
21030	4-tert-Butyl-2-fluoroaniline	129373-04-2	Contains (regardless of intentional or impurities)	chemical products
21031	Manganese oxide (MnO1.44)	129382-63-4	1%	chemical products
21032	Manganese oxide (MnO1.84)	129382-80-5	1%	chemical products
21033	2-Chloro-2-(2-chlorophenyl)ethanol	129472-78-2	1%	chemical products
21034	Tollenpyrad	129558-76-5	Intentional addition / 1%	chemical products
21035	4-Chloro-3-ethyl-1-methyl-5-pirazolecarbonyl chloride	129560-00-5	Contains (regardless of intentional or impurities)	chemical products
21036	Electrolytes, nickel-manufacturing	129618-34-4	Contains (regardless of intentional or impurities)	chemical products
21037	Electrolytes, copper-manufacturing	129618-35-5	Contains (regardless of intentional or impurities)	chemical products
21038	Solutions, copper hydrometallurgical	129618-36-6	Contains (regardless of intentional or impurities)	chemical products
21039	Solutions, nickel hydrometallurgical	129618-38-8	Contains (regardless of intentional or impurities)	chemical products
21040	Solutions, cobalt hydrometallurgical (Solutions of variable composition used in, or produced by hydrometallurgical processes for the extraction and refining of cobalt bearing materials. Such solutions may result from the leaching of a cobalt bearing material, the removal of impurities from a depleted cobalt electrolyte, or from the washing of solids such as precipitates and residues. The solutions generally contain metal ions such as cobalt, copper, iron, and other non-ferrous metals and residual organic compounds.)	129618-39-9	Intentional addition / 1,000ppm	chemical products
21041	7,8-Difluoro-5,6-dihydro-4-methyl-1-oxo-4H-3a-aza-1H-phenalene-2-carboxylic acid diacetylbutyl ester	129672-77-1	1%	chemical products
21042	Nickel sulfide (NiO.48-0.5S0.5-0.52)	129680-25-7	Contains (regardless of intentional or impurities)	chemical products
21043	Pyridine, 3-(1-methyl-2-pyrrolidinyl)-, (S)-, [S-(R*)]-2,3-dihydroxybutanedioate (1:1)	129721-88-6	Contains (regardless of intentional or impurities)	chemical products
21044	Ethanedioic acid, dysprosium(3+) salt	129836-95-9	Intentional addition	chemical products
21045	Ethanedioic acid, neodymium(3+) salt	129836-96-0	Intentional addition	chemical products
21046	Ethanedioic acid, erbium(3+) salt	129836-97-1	Intentional addition	chemical products
21047	Copper, [29H,31H-pthalocyaninato(2-)-N29,N30,N31,N32]-, (SP-4-1)-, reaction products with chlorosulfuric acid, sodium sulfide (Na2(Sx)) and thionyl chloride	129870-84-4	Intentional addition / 1,000ppm	chemical products
21048	C.I. Direct Red 83:1	129874-15-3	Intentional addition / 1,000ppm	chemical products
21049	Molybdenum potassium oxide (MoK0.32O3)	129925-73-1	1%	chemical products
21050	Molybdenum potassium oxide (MoK0.34O3)	129925-74-2	1%	chemical products
21051	Molybdenum potassium oxide (MoK0.39O3)	129925-75-3	1%	chemical products
21052	Molybdenum potassium oxide (MoK0.45-0.5O3)	129925-76-4	1%	chemical products
21053	Chromate(1-), bis[[4-[[1-(3-chlorophenyl)-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-4-yl]azo]-3-hydroxy-N-methylbenzenesulfonamido(2-)]]-, sodium	129984-38-9	Contains (regardless of intentional or impurities)	chemical products
21054	Chromate(1-), bis[[4-[[5-dihydro-3-methyl-5-oxo-1-[[4-[[1-oxo-2-propenyl]amino]phenyl]-1H-pyrazol-4-yl]azo]benzoato(2-)]]-, sodium	129984-39-0	Contains (regardless of intentional or impurities)	chemical products
21055	Cuprate(2-), [4-[[[4-amino-2-hydroxy-3-[[[4-nitrophenyl]azo]-5cuprate(2-), [4-[[[4-amino-2-hydroxy-3-[[[4-nitrophenyl]azo]-5-[[[4-nitro-2-sulfophenyl]amino]phenyl]azo]phenyl]azo]-3-hydroxy-7-nitro-1-naphthalenesulfonato(4-)]]-, disodium hydroxy-7-nitro-1-naphthalenesulfonato(4-)]]-, disodium	129984-40-3	Intentional addition / 1,000ppm	chemical products
21056	Reaction product of 3,4'-oxydianiline and 2-chloromethylloxirane, mainly composed of N,N,N',N'-tetrakis(oxyranil)methyl)-3,4'-oxydianiline	129988-27-2	Contains (regardless of intentional or impurities)	chemical products
21057	Iron boride (FeB29.5)	130005-28-6	1%	chemical products
21058	Gallium arsenide phosphide (GaAs0.93P0.07)	130042-18-1	1,000ppm	chemical products
21059	1,2,3,4,5,6,7,8,9,10,11-Decathia-6,12-diselenacyclododecane	130110-53-1	Contains (regardless of intentional or impurities)	chemical products
21060	1,2,3,4,5,6,7,8,9,10-Decathia-11,12-diselenacyclododecane	130110-54-2	Contains (regardless of intentional or impurities)	chemical products
21061	Cobalt sulfide (CoS4)	130114-33-9	Intentional addition / 1%	chemical products
21062	Bis(tripeptide-1) copper acetate	130120-57-9	Intentional addition / 1,000ppm	chemical products
21063	Boron carbide (B0.29C0.71)	130125-94-9	1%	chemical products
21064	Boron carbide (B0.08C0.92)	130125-95-0	1%	chemical products
21065	Boron carbide (B0.03C0.97)	130125-96-1	1%	chemical products
21066	Copper boride (CuB41.2)	130144-46-6	Intentional addition / 1,000ppm	chemical products
21067	Methyl (1S,3S,4R)-2-[[[R)-1-phenylethyl]-2-azabicyclo[2.2.1]hept-5-ene-3-carboxylate	130194-96-6	Contains (regardless of intentional or impurities)	chemical products
21068	Gold sodium sulfite (AuNa3S0.3O2)	130206-49-4	Intentional addition	chemical products
21069	Iron molybdenum oxide (Fe1.81-2Mo0-0.1O2.71-3)	130241-17-7	1%	chemical products
21070	Iron molybdenum oxide (Fe1.96Mo0.02O2.84)	130241-18-8	1%	chemical products
21071	Iron molybdenum oxide (Fe1.91Mo0.05O2.86)	130241-19-9	1%	chemical products
21072	Iron molybdenum oxide (Fe1.88Mo0.06O2.82)	130241-20-2	1%	chemical products
21073	Aluminum sodium silicate-silver complex	130328-18-6	Intentional addition / 100ppm	chemical products
21074	Silver-copper zeolite	130328-19-7	Intentional addition / 100ppm	chemical products
21075	Zeolites, AsZn	130328-20-0	Contains (regardless of intentional or impurities)	chemical products
21076	Cobalt oxide (CoO1.8-3)	130330-97-1	Intentional addition / 1%	chemical products
21077	Cellulose, carboxymethyl ether, cobalt(2+) salt	130391-06-9	Intentional addition / 1%	chemical products
21078	Boron nitride (B2-6N)	130459-08-4	1%	chemical products
21079	Molybdenum carbide (Mo0.42C0.58)	130459-28-8	1%	chemical products
21080	Polycyclic aromatic hydrocarbons	130498-29-2	Intentional addition / 100ppm	chemical products
21081	Borate(1-), tetrahydroxy-tungsten complex, compound with strychnine	130555-51-0	Contains (regardless of intentional or impurities)	chemical products
21082	Borate(1-), tetrahydroxy-tungsten complex, compound with nicotine	130555-55-4	Contains (regardless of intentional or impurities)	chemical products
21083	Molybdenum silicide (MoSi2.3-2.66)	130680-13-6	1%	chemical products
21084	Chromate(2-), [3-[[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]]-[2-(2-hydroxy-5-methoxyphenyl)azo]-4,6-dinitrophenolato(2-)]-, disodium	130701-55-2	Contains (regardless of intentional or impurities)	chemical products
21085	Cobalt_bis[2,4-dihydro-4-[[2-hydroxy-4-nitrophenyl]azo]-5-methyl-2-phenyl-3H-pyrazol-3-onato]-	130725-91-6	Intentional addition / 1%	chemical products
21086	1-Propanesulfonic acid, 2-hydroxy-, tin salt	130920-68-2	1,000ppm	chemical products
21087	Lithium molybdenum oxide (LiMoO3)	131097-40-0	1%	chemical products
21088	Cobalt oxide (CoO1.15)	131097-43-3	Intentional addition / 1%	chemical products
21089	Boric acid, B-B-bis(3,4-dichlorophenyl)-	131112-05-5	1%	chemical products
21090	Barium titanium oxide (BaTiO2.7-3)	131127-24-7	Intentional addition	chemical products
21091	Chromium lanthanum oxide (CrO.99La1.01O3)	131162-93-1	Intentional addition / 1,000ppm	chemical products
21092	Nickel oxide (NiO1-1.66)	131163-08-1	Contains (regardless of intentional or impurities)	chemical products
21093	Ammonium molybdenum oxide ((NH4)Mo3O9)	131163-67-2	1%	chemical products
21094	Barium titanium oxide (Ba1.07Ti8O16)	131163-78-5	Intentional addition	chemical products
21095	Barium titanium oxide (Ba1.31Ti8O16)	131163-79-6	Intentional addition	chemical products
21096	2,3,4,7,8-Pentabromodibenzofuran	131166-92-2	Intentional addition / 100ppm	chemical products
21097	1,1,1-Trichloro-2,2,3-trifluoropropane	131211-71-7	Intentional addition	chemical products
21098	1,1,3-Trichloro-2,3,3-trifluoropropane	131221-36-8	Intentional addition	chemical products
21099	Strychnidin-10-one, mono(-)-2-[[[4-nitrophenyl]methyl]sulfonyl]benzoate	131223-26-2	Contains (regardless of intentional or impurities)	chemical products
21100	Fluioxonil	131341-86-1	Intentional addition / 100ppm	chemical products
21101	Boron carbide (B3.7C)	131344-48-4	1%	chemical products
21102	Boron lithium oxide (B7Li3O12)	131347-01-8	1%	chemical products
21103	1,1-Dichloro-3,3-difluoropropane	131404-17-6	Intentional addition	chemical products
21104	3-Pyridineboronic acid 1,3-propanediol ester	131534-65-1	1%	chemical products
21105	Chromium boride (Cr10B2)	131549-38-7	1,000ppm	chemical products
21106	Barium calcium tungsten oxide	131578-84-6	Intentional addition	chemical products
21107	Arsenic selenide (As0-0.02Se0.98-1)	131599-73-0	Intentional addition / 1,000ppm	chemical products
21108	Arsenic selenide (As0.02Se0.98)	131599-74-1	Contains (regardless of intentional or impurities)	chemical products
21109	Arsenic selenide (As0.01Se0.99)	131599-76-3	Contains (regardless of intentional or impurities)	chemical products
21110	Doyle dirhodium catalyst - RH2(SR-MEPY)4	131796-58-2	Contains (regardless of intentional or impurities)	chemical products
21111	Methyl (E)-2-[2-[6-(2-cyanophenoxy)pyrimidin-4-yloxy]phenyl]-3-methoxyacrylate	131860-33-8	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
21112	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, sulfo [(4-[[2-(sulfoxo)ethyl]sulfonyl]phenyl]amino)sulfonyl derivatives, sodium salts	131866-99-4	Contains (regardless of intentional or impurities)	chemical products
21113	Nickelate(2-), hexakis(cyano-C)-, dipotassium, (OC-6-11)-	131896-79-2	Contains (regardless of intentional or impurities)	chemical products
21114	Vanadate (V2O62-), disodium	131906-47-3	1%	chemical products
21115	Barium niobium sodium oxide (Ba4.22Nb10.12Na1.44O30.24)	131914-14-2	Intentional addition	chemical products
21116	Asbestos, chrysotile	132207-32-0	Contains (regardless of intentional or impurities)	chemical products
21117	Crocidolite asbestos	132207-33-1	1,000ppm	chemical products
21118	4-Methoxy-3-biphenylamine hydrochloride	132230-40-1	Contains (regardless of intentional or impurities)	chemical products
21119	Boron nitride (B0.61N0.39)	132238-44-9	1%	chemical products
21120	Yohimbine-16-carboxylic acid, 17-hydroxy-, methyl ester, monohydrochloride, (16.alpha.,17.alpha.)-, mixture with strychnidin-10-one mononitrate	132271-09-1	Contains (regardless of intentional or impurities)	chemical products
21121	Cadmium-copper alloy	132295-56-8	Contains (regardless of intentional or impurities)	chemical products
21122	Cadmium-copper alloy	132295-57-9	Contains (regardless of intentional or impurities)	chemical products
21123	Strychnidin-10-one, compound, with monoethyl 9,10-dihydro-9,10-ethenoanthracene-11,12-dicarboxylate (1:1)	132335-57-0	Contains (regardless of intentional or impurities)	chemical products
21124	Chromate(3-), bis[3-[(5-chloro-2-hydroxyphenyl)azo]-4-hydroxy-6-[(1-oxo-2-propenyl)amino]-2-naphthalenesulfonato(3-)]-, trihydrogen	132435-13-3	Contains (regardless of intentional or impurities)	chemical products
21125	Chromate(3-), bis[3-[(5-chloro-2-hydroxyphenyl)azo]-4-hydroxy-6-[(1-oxo-2-propenyl)amino]-2-naphthalenesulfonato(3-)]-, trisodium	132435-14-4	Contains (regardless of intentional or impurities)	chemical products
21126	Doyle dirhodium catalyst - RH2[GS-MEPY]4	132435-65-5	Contains (regardless of intentional or impurities)	chemical products
21127	Chromate(2-), [3-[(5-chloro-2-hydroxyphenyl)azo]-4-hydroxy-6-[(1-oxo-2-propenyl)amino]-2-naphthalenesulfonato(3-)]-[1-[(2-hydroxy-4-nitrophenyl)azo]-2-naphthalenato(2-)]-, sodium	132539-03-8	Contains (regardless of intentional or impurities)	chemical products
21128	Chromate(3-), bis[3-[(5-chloro-2-hydroxyphenyl)azo]-4-hydroxy-6-[(1-oxo-2-propenyl)amino]-2-naphthalenesulfonato(3-)]-, sodium	132539-05-0	Contains (regardless of intentional or impurities)	chemical products
21129	Silicic acid (H6Si2O7), molybdenum(6+) salt (1:1)	132760-14-6	1%	chemical products
21130	Gallium arsenide phosphide (Ga0.32-0.44As0.16-0.38P0.14-0.37)	132826-04-1	1,000ppm	chemical products
21131	Antimony oxide silicate (Sb2O3(SiO4))	132826-46-1	Contains (regardless of intentional or impurities)	chemical products
21132	Barium titanium oxide (Ba0.19Ti0.81O1.82)	132827-00-0	Intentional addition	chemical products
21133	Barium titanium oxide (Ba0.18Ti0.81O1.82)	132827-01-1	Intentional addition	chemical products
21134	Barium titanium oxide (Ba0.16Ti0.84O1.84)	132827-08-8	Intentional addition	chemical products
21135	Gallium arsenide phosphide (GaAs0.3-0.8P0.2-0.7)	132851-71-9	1,000ppm	chemical products
21136	Copper, [29H,31H-phthalocyanine-2-carboxamidato(2-)-N29,N30,N31,N32]-, (SP-4-2)-	132879-97-1	Intentional addition / 1,000ppm	chemical products
21137	2-[[2-(3-chlorophenyl)oxiranylmethyl]-2-ethyl-1H-indene-1,3(2H)-dione	133220-30-1	1%	chemical products
21138	Nickel, pentakis(sulfurato(2-))-	133290-55-8	Contains (regardless of intentional or impurities)	chemical products
21139	Barium niobium sodium oxide (Ba0.65Nb1.65Na0.35O4.95)	133314-59-7	Intentional addition	chemical products
21140	Barium niobium sodium oxide (Ba0.64Nb1.64Na0.36O4.92)	133314-60-0	Intentional addition	chemical products
21141	Barium niobium sodium oxide (Ba0.63Nb1.63Na0.37O4.89)	133314-61-1	Intentional addition	chemical products
21142	Barium niobium sodium oxide (Ba0.62Nb1.62Na0.38O4.86)	133314-62-2	Intentional addition	chemical products
21143	Barium niobium sodium oxide (Ba0.61Nb1.61Na0.39O4.83)	133314-63-3	Intentional addition	chemical products
21144	Barium niobium sodium oxide (Ba0.6Nb1.6Na0.4O4.8)	133314-64-4	Intentional addition	chemical products
21145	Barium niobium sodium oxide (Ba0.67Nb1.67Na0.33O5.01)	133314-65-5	Intentional addition	chemical products
21146	Barium niobium sodium oxide (Ba0.68Nb1.68Na0.32O5.04)	133314-66-6	Intentional addition	chemical products
21147	Barium niobium sodium oxide (Ba0.69Nb1.69Na0.31O5.07)	133314-67-7	Intentional addition	chemical products
21148	Barium niobium sodium oxide (Ba0.7Nb1.7Na0.3O5.1)	133314-68-8	Intentional addition	chemical products
21149	Barium niobium sodium oxide (Ba0.72Nb1.72Na0.28O5.16)	133314-69-9	Intentional addition	chemical products
21150	Barium niobium sodium oxide (Ba0.75Nb1.75Na0.25O5.25)	133314-70-2	Intentional addition	chemical products
21151	Barium niobium sodium oxide (Ba0.77Nb1.77Na0.23O5.31)	133314-71-3	Intentional addition	chemical products
21152	Barium niobium sodium oxide (Ba0.79Nb1.79Na0.21O5.37)	133314-72-4	Intentional addition	chemical products
21153	Barium niobium sodium oxide (Ba0.8Nb1.8Na0.2O5.4)	133314-73-5	Intentional addition	chemical products
21154	Barium niobium sodium oxide (Ba0.82Nb1.82Na0.18O5.46)	133314-74-6	Intentional addition	chemical products
21155	Barium niobium sodium oxide (Ba0.84Nb1.84Na0.16O5.52)	133314-75-7	Intentional addition	chemical products
21156	Barium niobium sodium oxide (Ba0.85Nb1.85Na0.15O5.55)	133314-76-8	Intentional addition	chemical products
21157	Octathiaselenane	133333-94-5	Contains (regardless of intentional or impurities)	chemical products
21158	Molybdenum sodium oxide (MoNa0.4O3)	133340-80-4	1%	chemical products
21159	C.I. Acid Orange 154	133556-24-8	Contains (regardless of intentional or impurities)	chemical products
21160	2,4-Dimethoxybenzenboronic acid	133730-34-4	1%	chemical products
21161	Gallium arsenide phosphide (GaAs0.24P0.76)	133740-71-3	1,000ppm	chemical products
21162	Strychnidin-10-one, mono, (±)-bromochlorofluoracetate	133764-14-4	Contains (regardless of intentional or impurities)	chemical products
21163	Amines, N-C16-18-alkyl propane-1,3-diamine	133779-11-0	Intentional addition / 100ppm	chemical products
21164	Epoxiconazole	133855-98-8	Contains (regardless of intentional or impurities)	chemical products
21165	Butanoic acid, 2,3-dihydroxy-4-oxo-4-[(oxobutyl)oxy]-, monosodium salt, [R-(R*(R*))]-	133915-53-4	Contains (regardless of intentional or impurities)	chemical products
21166	Potassium antimony tartrate	133915-54-5	Contains (regardless of intentional or impurities)	chemical products
21167	Arsenic selenide (As0.45Se0.6-1)	133927-17-0	Contains (regardless of intentional or impurities)	chemical products
21168	1-Propanesulfonic acid, 3-hydroxy-, tin salt	133988-84-8	1,000ppm	chemical products
21169	Molybdenum silicide (MoSi16)	134001-07-3	1%	chemical products
21170	Hydrotris(3-(2-thienyl)pyrazol-1-yl)borate, thallium salt	134030-71-0	Intentional addition / 1,000ppm	chemical products
21171	Fenpropoximate	134098-61-6	Contains (regardless of intentional or impurities)	chemical products
21172	Bromomethylpropanes	134115-64-3	1,000ppm	chemical products
21173	Dibenzylphenylsulfonium hexafluoroantimonate	134164-24-2	Contains (regardless of intentional or impurities)	chemical products
21174	HCFC-231	134190-48-0	Intentional addition / 1,000ppm	chemical products
21175	HCFC-241	134190-49-1	Intentional addition / 1,000ppm	chemical products
21176	HCFC-244	134190-50-4	Intentional addition / 1,000ppm	chemical products
21177	HCFC-251	134190-51-5	Intentional addition / 1,000ppm	chemical products
21178	HCFC-252	134190-52-6	Intentional addition / 1,000ppm	chemical products
21179	HCFC-262	134190-53-7	Intentional addition / 1,000ppm	chemical products
21180	Chlorofluoropropanes	134190-54-8	Intentional addition / 1,000ppm	chemical products
21181	3,4,5-Trifluorobenzonitrile	134227-45-5	Intentional addition	chemical products
21182	Pentachlorotrifluoropropanes	134237-31-3	Intentional addition / 1,000ppm	chemical products
21183	HCFC-121	134237-32-4	Intentional addition / 1,000ppm	chemical products
21184	Ethane, 1,2,2-trichloro-1,1-difluoro-	134237-33-5	Intentional addition	chemical products
21185	HCFC-131	134237-34-6	Contains (regardless of intentional or impurities)	chemical products
21186	HCFC-221	134237-35-7	Intentional addition / 1,000ppm	chemical products
21187	Pentachlorodifluoropropane	134237-36-8	Intentional addition / 1,000ppm	chemical products
21188	HCFC-223	134237-37-9	Intentional addition / 1,000ppm	chemical products
21189	HCFC-224	134237-38-0	Intentional addition / 1,000ppm	chemical products
21190	Tetrachlorodifluoropropane	134237-39-1	Intentional addition / 1,000ppm	chemical products
21191	HCFC-233	134237-40-4	Intentional addition / 1,000ppm	chemical products
21192	HCFC-235	134237-41-5	Intentional addition / 1,000ppm	chemical products
21193	HCFC-242	134237-42-6	Intentional addition / 1,000ppm	chemical products
21194	Dichlorotrifluoropropane	134237-43-7	Intentional addition / 1,000ppm	chemical products
21195	Chlorotrifluoropropanes	134237-44-8	Intentional addition / 1,000ppm	chemical products
21196	Dichlorofluoropropanes	134237-45-9	Intentional addition / 1,000ppm	chemical products
21197	1-Chloro-1,1,2-trifluoropropane	134237-05-1	Intentional addition	chemical products
21198	HCFC-226	134308-72-8	Intentional addition	chemical products
21199	Bis(hexafluoropentanedionato)barium, tetraglyme adduct	134316-23-7	Intentional addition / 1,000ppm	chemical products
21200	Aluminum zirconium trichlorohydrate glycine	134375-99-8	Contains (regardless of intentional or impurities)	chemical products
21201	Iron molybdenum oxide (Fe2Mo3.8-9.8O14.4-32.4)	134382-80-2	Intentional addition / 1%	chemical products
21202	Boron nitride (B0.67-2)	134398-22-4	Intentional addition / 1%	chemical products
21203	CFC-212	134452-44-1	Intentional addition / 1,000ppm	chemical products
21204	Molybdenum tetrachloride dimethoxyethane complex	134535-29-8	Contains (regardless of intentional or impurities)	chemical products
21205	Lithium molybdenum oxide (Li0-0.2MoO3)	134608-87-0	Intentional addition / 1%	chemical products
21206	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [3-[(5-chloro-6-fluoro-4-pyrimidinyl)amino]phenyl]amino)sulfonyl sulfo derivatives, sodium salts	134737-17-0	Contains (regardless of intentional or impurities)	chemical products
21207	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, aminosulfonyl [[3-[(5-chloro-6-fluoro-4-pyrimidinyl)amino]phenyl]amino)sulfonyl sulfo derivatives, sodium salts	134737-18-1	Intentional addition / 1,000ppm	chemical products
21208	Fatty acids, (C16-250), copper(2+) salts	134758-96-6	Intentional addition / 1,000ppm	chemical products
21209	Butanedioic acid monoalkyl (C12-246) derivatives, copper(2+) salts	134759-19-6	Intentional addition / 1,000ppm	chemical products
21210	Molybdenum potassium oxide (Mo6KO17)	134776-01-5	Intentional addition / 1%	chemical products
21211	Nickel sulfide (Ni2.9S2)	134830-74-3	Contains (regardless of intentional or impurities)	chemical products
21212	Nickel oxide (NiO0.8)	134831-06-4	Contains (regardless of intentional or impurities)	chemical products
21213	Molybdenum silicide (MoSi0.8)	134853-62-6	Intentional addition / 1%	chemical products
21214	Molybdenum silicide (MoSi1.2)	134853-63-7	Intentional addition / 1%	chemical products
21215	Barium titanium oxide (Ba4Ti12O27)	134883-98-0	Intentional addition	chemical products
21216	Calcium molybdenum oxide (CaMo0.99O4)	134884-72-3	Intentional addition / 1%	chemical products
21217	2-Proxopxybenzenboronic acid	134896-34-7	Intentional addition / 1%	chemical products
21218	Manganese oxide (MnO2.99)	134904-59-9	Intentional addition / 1%	chemical products
21219	Manganese oxide (MnO2.1)	134904-60-2	Intentional addition / 1%	chemical products
21220	Manganese oxide (MnO4.35)	134904-61-3	Intentional addition / 1%	chemical products
21221	Manganese oxide (MnO2.38)	134904-62-4	Intentional addition / 1%	chemical products
21222	Manganese fluoride (MnF2.19)	134904-63-5	Contains (regardless of intentional or impurities)	chemical products
21223	Aluminum zirconium tetrachlorohydrate glycine complex	134910-86-4	Contains (regardless of intentional or impurities)	chemical products
21224	6-Methyl-2,4-bis(methylthio)-3-nitropyridine	134992-24-8	Intentional addition / 1%	chemical products
21225	2,5-Dichlorobenzeneboronic acid	135145-90-3	Intentional addition / 1%	chemical products
21226	Boron nitride (B0.68N0.32)	135156-10-4	Intentional addition / 1%	chemical products
21227	Pratherm EC 20	135229-48-0	Intentional addition / 900ppm	chemical products
21228	Gallium arsenide phosphide (GaAs0.19P0.81)	135282-54-1	Intentional addition / 1,000ppm	chemical products
21229	Gallium arsenide phosphide (GaAs0.28P0.72)	135282-55-2	Intentional addition / 1,000ppm	chemical products
21230	Heptachlorofluoropropane	135401-87-5	Intentional addition / 1,000ppm	chemical products
21231	Copper boride (Cu2B)	135403-53-1	Intentional addition / 1,000ppm	chemical products
21232	(E)-N-[(6-Chloro-3-pyridyl)methyl]-N-cyano-N-methylacetamide	135410-20-7	Contains (regardless of intentional or impurities)	chemical products
21233	Cuprate(1-), [C,C,C,C-tetrachloro-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen	135429-22-0	Intentional addition / 1,000ppm	chemical products
21234	Cuprate(1-), [C,C,C,C-tetrachloro-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen, compound with 1-octadecanamine (1:1)	135429-23-1	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
21235	(OC-6-21)-Tris(2,4-heptanedionato-O,O')cobalt	135443-46-8	Intentional addition / 1,000ppm	chemical products
21236	Boron carbide (B0.5C0.5-1)	135495-66-8	Intentional addition / 1%	chemical products
21237	Boron carbide (B4.3C)	135518-85-3	Intentional addition / 1%	chemical products
21238	Copper fluoride (CuF1.7)	135519-18-5	Intentional addition / 1,000ppm	chemical products
21239	Copper fluoride (CuF1.81)	135519-19-6	Intentional addition / 1,000ppm	chemical products
21240	Copper fluoride (CuF1.82)	135519-20-9	Intentional addition / 1,000ppm	chemical products
21241	Copper fluoride (CuF1.95)	135544-20-6	Intentional addition / 1,000ppm	chemical products
21242	Molybdenum silicide (MoSi2.46)	135544-38-6	Intentional addition / 1%	chemical products
21243	(OC-6-22)-Tris(2,4-hexanedionato-O,O')cobalt	135556-77-3	Intentional addition / 1,000ppm	chemical products
21244	Cobalt, tris(3,5-heptanedionato-O,O')-(OC-6-22)-	135556-77-3	Intentional addition / 1%	chemical products
21245	6-Tris(2,4-hexanedionato)cobalt	135556-88-6	Intentional addition / 1%	chemical products
21246	Gallium arsenide phosphide (GaAs0.85-0.98P0.02-0.15)	135573-19-2	Intentional addition / 1,000ppm	chemical products
21247	Gallium arsenide phosphide (GaAs0.92-0.98P0.02-0.08)	135573-20-5	Intentional addition / 1,000ppm	chemical products
21248	Gallium arsenide phosphide (GaAs0.86-1P0-0.14)	135573-21-6	Intentional addition / 1,000ppm	chemical products
21249	4-Acetoxyphenyldimethylsulfonium hexafluoroantimonate	135691-31-5	Intentional addition / 1,000ppm	chemical products
21250	Fatty acids, C8-12, cadmium salts	135742-32-4	Contains (regardless of intentional or impurities)	chemical products
21251	1H-Pyrrole-2-boronic acid, N-BOC protected	135884-31-0	Intentional addition / 1%	chemical products
21252	Ammonium boron oxide ((NH4)B5O8), hydrate (1:4)	135890-30-1	Intentional addition / 1%	chemical products
21253	Silicic acid (H4SiO4), tetraethyl ester, polymer with trichlorostibine	135929-41-8	Contains (regardless of intentional or impurities)	chemical products
21254	Silicic acid (H4SiO4), tetraethyl ester, polymer with boron oxide (B2O3)	135929-44-1	Intentional addition / 1%	chemical products
21255	Iron boride (Fe7-8B)	135954-05-1	Intentional addition / 1%	chemical products
21256	Gallium arsenide phosphide (GaAs0.0-3P0.7-1)	135988-79-3	Intentional addition / 1,000ppm	chemical products
21257	1,3-Dichloro-1,1,2,3,3-pentafluoropropane	136013-79-1	Intentional addition / 1,000ppm	chemical products
21258	Methylum, triphenyl-, tetrakis(pentafluorophenyl)borate(1-)	136040-19-2	Contains (regardless of intentional or impurities)	chemical products
21259	4-(Bromomethyl)-3-fluorobiphenyl-2-carbonitrile	136042-63-2	Intentional addition / 1%	chemical products
21260	Molybdenum silicide (MoSi0.3)	136097-17-1	Intentional addition / 1%	chemical products
21261	Molybdenum sodium oxide (Mo2Na0.5O4)	136140-93-7	Intentional addition / 1%	chemical products
21262	Chromium sodium oxide (CrNa0.85-1O2)	136141-00-9	Intentional addition / 1,000ppm	chemical products
21263	Pyriminobac-methyl	136191-64-5	Intentional addition / 1%	chemical products
21264	Gallium arsenide phosphide (GaAs0.91P0.09)	136254-80-3	Intentional addition / 1,000ppm	chemical products
21265	Gallium arsenide phosphide (GaAs0.25-0.8P0.2-0.75)	136299-46-2	Intentional addition / 1,000ppm	chemical products
21266	2,6-Difluoro-3-pyridineboronic acid	136466-94-9	Intentional addition / 1%	chemical products
21267	6,12-Dioxo-4,8-dithia-5,7-distannaecosanoic acid, 5,5,7,7-tetrabutyl-11-oxo-, octyl ester	136482-55-8	Contains (regardless of intentional or impurities)	chemical products
21268	4-Carboxy-3-chlorophenylboronic acid	136496-72-5	Intentional addition / 1%	chemical products
21269	2-Methoxy-4-nitrobenzaldehyde	136507-15-8	Intentional addition / 1%	chemical products
21270	2,3,6-Trifluorobenzonitrile	136514-17-5	Intentional addition	chemical products
21271	Cadmium selenide (Cd0.95Se)	136543-49-2	Contains (regardless of intentional or impurities)	chemical products
21272	Cadmium selenide (Cd0.98Se)	136543-50-5	Contains (regardless of intentional or impurities)	chemical products
21273	Cadmium selenide (CdSe0.97)	136543-51-6	Contains (regardless of intentional or impurities)	chemical products
21274	Gallium arsenide phosphide (GaAs0.78P0.22)	136575-46-7	Intentional addition / 1,000ppm	chemical products
21275	Aluminate (Al(OH)63-), (OC-6-11)-, magnesium carbonate perchlorate (5:10:1:3)	136618-51-4	Intentional addition / 1,000ppm	chemical products
21276	Gallium arsenide phosphide (GaAs0.1-0.5P0.5-0.9)	136654-91-6	Intentional addition / 1,000ppm	chemical products
21277	Gallium arsenide phosphide (GaAs0.17P0.83)	136654-92-7	Intentional addition / 1,000ppm	chemical products
21278	Dodecane, 1,3,5,7,9,11-hexachloro-	136671-00-6	Intentional addition / 1,000ppm	chemical products
21279	Polychlorinated dibenzo-p-dioxins	136677-09-3	Contains (regardless of intentional or impurities)	chemical products
21280	(+)-1,2-Bis((2S,5S)-dimethylphospholano)benzene(cyclooctadiene)rhodium(I) triflate	136705-75-4	Contains (regardless of intentional or impurities)	chemical products
21281	(-)-1,2-Bis((2R,5R)-diethylphospholano)benzene(cyclooctadiene)rhodium(I) triflate	136705-77-6	Contains (regardless of intentional or impurities)	chemical products
21282	Boron carbide (B0.91C0.09)	136770-24-6	Intentional addition / 1%	chemical products
21283	Boron carbide (B0.86C0.14)	136770-25-7	Intentional addition / 1%	chemical products
21284	Boron carbide (B0.83C0.17)	136770-26-8	Intentional addition / 1%	chemical products
21285	6-Vinyl-2-naphthol	136896-92-9	Contains (regardless of intentional or impurities)	chemical products
21286	Antimony tin oxide	137002-11-0	Contains (regardless of intentional or impurities)	chemical products
21287	Copper boride (Cu4.2B105)	137002-26-7	Intentional addition / 1,000ppm	chemical products
21288	Molybdenum, bis[bis(2-ethylhexyl)carbamodithioato-S,S']oxothioxo-	137025-39-9	Intentional addition / 1%	chemical products
21289	Gallium arsenide phosphide (GaAs0.03-0.3P0.7-0.97)	137026-16-5	Intentional addition / 1,000ppm	chemical products
21290	Nickel fluoride (NiF2-3)	137136-40-4	Contains (regardless of intentional or impurities)	chemical products
21291	2-Butenoic acid, 4,4',4''-(octylstannylidene)tris(oxy)tris[4-oxo-, tricyclohexyl ester, (2,2,2)-	137297-08-6	Intentional addition / 1,000ppm	chemical products
21292	Diisopropyl (bromomethyl)boronate	137297-49-5	Intentional addition / 1%	chemical products
21293	Emamectin	137335-79-6	Intentional addition / 2%	chemical products
21294	[Dimethylsilylene]bis[(1,2,3,3a,7a-eta)-1H-inden-1-ylidene]dimethylhafnium	137390-08-0	Contains (regardless of intentional or impurities)	chemical products
21295	Molybdenum silicide (MoSi1.89-2.16)	137486-11-4	Intentional addition / 1%	chemical products
21296	Barium titanium oxide (Ba1.04Ti0.3O4)	137486-74-9	Intentional addition	chemical products
21297	Barium titanium oxide (BaTi7O14)	137511-41-2	Intentional addition	chemical products
21298	Emamectin benzoate	137512-74-4	Intentional addition / 2%	chemical products
21299	Gallium arsenide phosphide (GaAs0.79P0.21)	137575-12-3	Intentional addition / 1,000ppm	chemical products
21300	Gallium arsenide phosphide (GaAs0.51P0.49)	137575-13-4	Intentional addition / 1,000ppm	chemical products
21301	Barium oxide (BaO1.75)	137575-49-6	Intentional addition	chemical products
21302	Manganese oxide (MnO0.4-2)	137633-98-8	Intentional addition / 1%	chemical products
21303	beta.-Cyclodextrin, compound with (S)-3-(1-methyl-2-pyrrolidyl)pyridine	137740-94-4	Contains (regardless of intentional or impurities)	chemical products
21304	Molybdenum, bis(diisooctylcarbamodithioato-kappa.S,kappa.S')oxothioxo-	137781-03-4	Intentional addition / 1%	chemical products
21305	Yttrium oxide (Y2O3), terbium-doped	138009-63-9	Intentional addition / 1%	chemical products
21306	Hydrotris(3-poly(pyrazol-1-yl)borate, thallium salt	138072-88-5	Intentional addition / 1,000ppm	chemical products
21307	Manganese, chloro[[2,2'-[[[1R,2R]-1,2-cyclohexanediyl]bis(nitro-kappa.N)methylidene]bis[4,6-bis(1,1-dimethylethyl)phenolato-kappa.O]](2-)]-, (SP-5-13)-	138124-32-0	Contains (regardless of intentional or impurities)	chemical products
21308	Imidacloprid	138261-41-3	Contains (regardless of intentional or impurities)	chemical products
21309	(2S,4R)-4-Methylsulfonyloxy-2-methoxycarbonylpyrrolidine-1-carboxylate, 4-nitrobenzyl	138324-82-0	Contains (regardless of intentional or impurities)	chemical products
21310	Pentane, 1,1,1,2,2,3,4,5,5,5-decafluoro-	138495-42-8	Contains (regardless of intentional or impurities)	chemical products
21311	1-Bromo-3,4,5-trifluorobenzene	138526-69-9	Contains (regardless of intentional or impurities)	chemical products
21312	Sodium salt of 3,6-bis[(2-arsenophenyl)azo]-4,5-dihydroxy-2,7-naphthalenedisulfonic acid	138608-19-2	Intentional addition / 1%	chemical products
21313	Boronic acid, B-(2-cyanophenyl)-	138642-62-3	Intentional addition / 1%	chemical products
21314	1-Tris(isopropylsilyl)-1H-pyrrole-3-boronic acid	138900-55-7	Intentional addition / 1%	chemical products
21315	4-(5-Methyl-1,3-benzoxazol-2-yl)biphenyl-4-amine	139036-50-3	Contains (regardless of intentional or impurities)	chemical products
21316	4,5-Dichlorophthalonitrile	139152-08-2	Intentional addition	chemical products
21317	N,N-Tetramethyldiamidophosphate-aza-18-crown-6 diiodide	139194-01-7	Intentional addition / 1,000ppm	chemical products
21318	Phosphorus(1+), bis(N-methylmethanaminato)methyl(1,4,7,10-tetraoxa-13-azacyclopentadecanato-N)-, iodide, (T-4)-	139194-04-0	Intentional addition / 1,000ppm	chemical products
21319	Phosphorus(1+), mu.-1,4,10,13-tetraoxa-7,16-diazacycloctadecane-7,16-diyl(difluorobis(N-methylmethanaminato)dimethyl-, diiodide	139194-05-1	Intentional addition / 1,000ppm	chemical products
21320	Zirconium, chloro hydroxy methacrylate myristate propylene glycol aluminum complexes	139201-77-7	Contains (regardless of intentional or impurities)	chemical products
21321	Zirconium, chloro hydroxy 3-mercaptopropionate propylene glycol aluminum complexes	139201-78-8	Contains (regardless of intentional or impurities)	chemical products
21322	Iodonium, [4-(2-hydroxytetradecyloxy)phenyl]phenyl-, (OC-6-11)-hexafluoroantimonate(1-)	139301-16-9	Contains (regardless of intentional or impurities)	chemical products
21323	Tetrabutylammonium difluorotriphenyl stannate	139353-88-1	Intentional addition / 1,000ppm	chemical products
21324	Complex of the two molecules of 2-(2-hydroxy-6-nitro-4-sulfo-1-naphthylazo)-1-hydroxynaphthalene sodium salt with one atom of chromium	139460-45-0	Contains (regardless of intentional or impurities)	chemical products
21325	Bis[1-(2-chlorophenyl)-2-[3-methoxy-4-(2-methoxyethoxy)phenyl]-1,2-ethenedithiolate(2-)-S,S']nickel	139562-87-1	Contains (regardless of intentional or impurities)	chemical products
21326	Trimethylvinylsilylhexafluoroacetylacetonato copper I	139566-53-3	Intentional addition / 1,000ppm	chemical products
21327	Prathem EC 14	139638-58-7	Intentional addition / 900ppm	chemical products
21328	Chromate(1-), [4-[[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazolo-4-yl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, hydrogen	139728-49-7	Contains (regardless of intentional or impurities)	chemical products
21329	Amines, n-C10-18-alkyltrimethylenedi-, reaction products with chloroacetic acid	139734-65-9	Intentional addition / 1,000ppm	chemical products
21330	Indium tribromide dihydrate	139767-61-6	Intentional addition / 1,000ppm	chemical products
21331	Cuprate(4-), [C-[[[3-(4-amino-6-chloro-1,3,5-triazin-2-yl)amino]-2-sulfonyl]amino]sulfonyl]-29H,31H-phthalocyanine-C,C,C-trisulfonato(6-)-N29,N30,N31,N32]-, trisodium hydrogen	139892-42-5	Intentional addition / 1,000ppm	chemical products
21332	4-Fluoro-3-methylbenzenecarboxylic acid	139911-27-6	Intentional addition / 1%	chemical products
21333	(RS)-2-Cyano-N-[(R)-1-(2,4-dichlorophenyl)ethyl]-3,3-dimethylbutanamide	139920-32-4	Intentional addition / 1%	chemical products
21334	O-ethyl-S-N-propyl(2-cyanomino-3-ethylimidaxoline-1-yl)phosphonothiolate	140163-89-9	Intentional addition	chemical products
21335	Solvent naphtha (coal), high-temperature	140362-62-5	Intentional addition / 1,000ppm	chemical products
21336	Solvent naphtha (coal tar), high-temperature	140362-63-6	Intentional addition / 1,000ppm	chemical products
21337	2,6-Dichloro-1-fluoropyridiniumtetrafluoroborate	140623-89-8	Contains (regardless of intentional or impurities)	chemical products
21338	1,4-Diazoniabicyclo[2.2.2]octane, 1-(chloromethyl)-4-fluoro-, bis(tetrafluoroborate(1-))	140681-55-6	Contains (regardless of intentional or impurities)	chemical products
21339	4-Aza-1-azoniabicyclo[2.2.2]octane, 1-(chloromethyl)-, tetrafluoroborate(1-)	140681-69-2	Intentional addition / 1%	chemical products
21340	2-Methyl-p-phenylenediamine hemisulfate	140697-63-8	Intentional addition / 25%	chemical products
21341	Chromate(4-), [2-hydroxybenzoato(2-)-O1,O2][4-hydroxy-3-[[2-hydroxy-5-nitro-3-sulfonyl]azo]-6-[[3-sulfonyl]amino]-2-naphthalenesulfonato(5-)]-, potassium sodium	140835-91-2	Contains (regardless of intentional or impurities)	chemical products
21342	Cuprate(3-), [2-[[[3-[[4-chloro-6-[ethyl[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-kappa.O)-5-sulfonyl]azo-kappa.N2]phenylmethyl]azo-kappa.N1]-4-sulfobenzoato(5-)-kappa.O]-, trihydrogen	140871-20-1	Intentional addition / 1,000ppm	chemical products
21343	Undecane, 2,4,6,8,10-pentachloro-	140899-23-6	Intentional addition / 1,000ppm	chemical products
21344	Cuprate(4-), [8-hydroxy-7-[[[2,5-dihydroxy-7-sulfo-6-[[[2,6-trichloro-4-pyrimidinyl]amino]phenyl]azo]-1-naphthalenyl]azo]-1,3,5-naphthalenetrisulfonato(6-)]-, tetrasodium	141048-13-7	Contains (regardless of intentional or impurities)	chemical products
21345	Perfluoropentadecanoic acid	141074-63-7	Intentional addition / 1%	chemical products
21346	Cyclohex-1-ene-1-boronic acid, pinacol ester	141091-37-4	Intentional addition / 1%	chemical products
21347	2-Bromo-1-oxan-4-ylmethanone	141095-78-5	Contains (regardless of intentional or impurities)	chemical products
21348	Strychnidin-10-one, compound with [R-(R*,R*)]-diethyl[[hydroxymethoxyphosphinothioyl]thio]butanedioate (1:1)	141263-98-1	Contains (regardless of intentional or impurities)	chemical products
21349	Strychnidin-10-one, compound with [R-(R*,S*)]-diethyl[[hydroxymethoxyphosphinothioyl]thio]butanedioate (1:1)	141264-00-8	Contains (regardless of intentional or impurities)	chemical products
21350	Strychnidin-10-one, compound with [S-(R*,S*)]-diethyl[[hydroxymethoxyphosphinothioyl]thio]butanedioate (1:1)	141264-02-0	Contains (regardless of intentional or impurities)	chemical products
21351	Strychnidin-10-one, compound with [S-(R*,R*)]-diethyl[[hydroxymethoxyphosphinothioyl]thio]butanedioate (1:1)	141264-04-2	Contains (regardless of intentional or impurities)	chemical products
21352	Trifloxystrobin	141517-21-7	Contains (regardless of intentional or impurities)	chemical products
21353	Tridecane, 2,4,6,8,10,12-hexachloro-	141600-29-5	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
21354	(4-Hydroxyphenyl)methyl[2-(2-methylphenyl)methylsulfonium, (OC-6-11)-hexafluoroantimonate(1-)]	141651-31-2	Contains (regardless of intentional or impurities)	chemical products
21355	Boric acid (H3BO3), compound with alpha.,alpha.'-[[hexylimino]di-2,1-ethanediy]bis[omega.-hydroxypoly(oxy-1,2-ethanediy)]	141785-76-4	Intentional addition / 1%	chemical products
21356	Cuprate(1-), [2-[[[29H,31H-phthalocyanin-1-ylmethyl]amino]carboxyl]benzoato(3-)-N29,N30,N31,N32]-, barium (2,1), (SP-4-2)-	141788-40-1	Intentional addition / 1,000ppm	chemical products
21357	2-Anthracceneboronic acid	141981-64-8	Intentional addition / 1%	chemical products
21358	Ferrate(1-), [N-[2-bis(carboxymethyl)amino]ethyl]-N-(2-hydroxyethyl)glycinate(3-)]hydroxy-, sodium	142042-22-6	Intentional addition / 1%	chemical products
21359	Nickel carbonate hydroxide	142164-39-4	Contains (regardless of intentional or impurities)	chemical products
21360	4-Bromo-1-butylboronic acid catechol ester	142172-51-8	Intentional addition / 1%	chemical products
21361	(+)-1,2-Bis(2,5,5'-diethylphospholano)benzene(cyclooctadiene)rhodium(I) triflate	142194-30-3	Contains (regardless of intentional or impurities)	chemical products
21362	2-(4-alpha-Dichlorobenzoyl)pyridine	142404-69-1	Contains (regardless of intentional or impurities)	chemical products
21363	Molybdenum carbide (MoC0.6)	142871-49-6	Intentional addition / 1%	chemical products
21364	Manganese rac-glycerol-1-phosphate	143007-66-3	Contains (regardless of intentional or impurities)	chemical products
21365	Chromate(3-), bis[2-hydroxy-5-[5(or 8)-sulfo-2-naphthalenyl]azo]benzoato(3-)-O1,O2]-, trisodium	143065-90-1	Contains (regardless of intentional or impurities)	chemical products
21366	5-Amino-2-methoxy-4,4-dimethyl-3-oxopentananilide sulfate	143183-25-9	Intentional addition / 1%	chemical products
21367	Kresoxim-methyl	143390-89-0	Contains (regardless of intentional or impurities)	chemical products
21368	1-[4-(Chloromethyl)phenyl]-1H-pyrazole	143426-52-2	Contains (regardless of intentional or impurities)	chemical products
21369	Boronic acid, 4-(4-pentylcyclohexyl)phenyl trans-	143651-26-7	Intentional addition / 1%	chemical products
21370	Cuprate(1-), [mu.-[[2-[[1,2-ethanediy]bis[imino(6-fluoro-1,3,5-triazine-4,2-diy)imino(2-hydroxy-5-sulfo-3,1-phenylene)azo]phenyl)methyl]azo]bis[4-sulfobenzoato(1-)](10-)]di-, sodium salt	143775-89-7	Intentional addition / 1,000ppm	chemical products
21371	R(+)-2-(2,4-Dichlorophenoxy) propanoyl chloride	143839-64-9	Contains (regardless of intentional or impurities)	chemical products
21372	2,3,4-Trifluorobenzonitrile	143879-80-5	Intentional addition	chemical products
21373	Copper alloy, base	144044-42-8	Intentional addition / 1,000ppm	chemical products
21374	1H-Indole-5-boronic acid	144104-59-6	Intentional addition / 1%	chemical products
21375	Lithium pyrrolidinoborohydride	144188-76-1	Intentional addition / 1%	chemical products
21376	Triphenylsulfonium nonafluorobutanesulfonate	144317-44-2	Intentional addition / 25%	chemical products
21377	3-Chloro-4-fluorophenylboronic acid	144432-85-9	Intentional addition / 1%	chemical products
21378	Manganese titanium tungsten oxide (Mn,Ti,W/O2)	144437-66-1	Contains (regardless of intentional or impurities)	chemical products
21379	Cobalt titanium tungsten oxide ((Co,Ti,W/O2)	144437-67-2	Intentional addition / 100ppm	chemical products
21380	3-Butyl-2-[5-(1,3-dihydro-3,3-dimethyl-1-propyl-2H-indol-2-ylidene)-1,3-pentadienyl]-1,1-dimethyl-1H-benz[e]indolium perchlorate	144440-76-6	Intentional addition / 1,000ppm	chemical products
21381	Slimes and Sludges, sulfuric acid manufacture, sulfur dioxide cooling tower, selenium-containing (A seleniferous sludge formed during the production of sulfuric acid by the periodic cleansing of the scrubbing and cooling columns for sulfur dioxide. It contains approximately 40 selenium and also contains sulfuric acid, as well as Ag, Cd, Hg, Pb and Zn in the form of sulfides, selenides, or sulfates.)	144507-49-3	Contains (regardless of intentional or impurities)	chemical products
21382	Zinc germanate, manganese doped	144713-07-5	Contains (regardless of intentional or impurities)	chemical products
21383	10-(3-Chloro-1-azabicyclo[2.2.2]octa-3-ylmethyl)phenothiazine	144827-81-6	Intentional addition / 1%	chemical products
21384	Cuprate(1-), [mu.-[[2-[[[3-[[4-[[5-[[4-[[3-[[[2-carboxy-5-sulfophenyl]azo]phenyl)methyl]azo]-2-hydroxy-5-sulfophenyl]amino]-6-chloro-1,3,5-triazin-2-yl]amino]-2-sulfophenyl]methyl]amino]-6-chloro-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulfophenyl]azo]phenyl)methyl]azo]-4-sulfobenzoato(1-)](11-)]di-, potassium sodium	144971-10-8	Intentional addition / 1,000ppm	chemical products
21385	2,3',4-Tribromobiphenyl	144978-86-9	Intentional addition / 1,000ppm	chemical products
21386	2,3',4,4',6'-Hexabromobiphenyl	144978-87-0	Intentional addition / 1,000ppm	chemical products
21387	2,2',3,4,5,5'-Hexabromo[1,1'-biphenyl]	144978-88-1	Intentional addition / 1,000ppm	chemical products
21388	2,3',4,6'-Pentabromobiphenyl	144978-89-2	Intentional addition / 1,000ppm	chemical products
21389	2,2',4-Tribromobiphenyl	144978-90-5	Intentional addition / 1,000ppm	chemical products
21390	3-Ethyl-1,1,2-trimethyl-1H-benzo[e]indole-3-ium p-toluenesulfonate	145038-03-5	Contains (regardless of intentional or impurities)	chemical products
21391	4-Butylphenylboronic acid	145240-28-4	Intentional addition / 1%	chemical products
21392	Octadecanoic acid, 12-hydroxy-, iron(3+) salt (3:1)	145401-57-6	Intentional addition / 1%	chemical products
21393	Naphtho[2,1-b]furan-1(2H)-one oxime	145411-54-7	Contains (regardless of intentional or impurities)	chemical products
21394	Boronic acid, B-(4-butyl[1,1'-biphenyl]-4-yl)-	145413-17-8	Intentional addition / 1%	chemical products
21395	4-Bromo-1-naphthaleneboronic acid	145985-14-6	Intentional addition / 1%	chemical products
21396	1-Naphthalenol, polymer with 1,4-bis(methoxymethyl)benzene and (chloromethyl)oxirane	146088-72-4	Contains (regardless of intentional or impurities)	chemical products
21397	2-(tert-Butoxycarbonylamino)phenylboronic acid	146140-85-6	Intentional addition / 1%	chemical products
21398	Boronic acid, B-[4-(pentyloxy)phenyl]-	146449-90-3	Intentional addition / 1%	chemical products
21399	Arsenic acid (H3AsO4), copper(2+) sodium salt (4.5:1), pentahydrate	146504-31-6	Contains (regardless of intentional or impurities)	chemical products
21400	4-Benzoyloxyphenylboronic acid	146631-00-7	Intentional addition / 1%	chemical products
21401	Boronic acid, 4-(4-propylcyclohexyl)phenyl-trans	146882-02-4	Intentional addition / 1%	chemical products
21402	Formaldehyde polymer with (chloromethyl)oxirane and 2,7-naphthalenediol	146876-45-1	Intentional addition / 1%	chemical products
21403	Phosphine selenide, (pentafluorophenyl)diphenyl-	146922-05-6	Contains (regardless of intentional or impurities)	chemical products
21404	Zirconium, bis(4-aminobenzoato-O)bis[2,2-bis(2-propenyl)oxy]methyl]-1-butanolato-O]-], (T-4)-	146955-66-0	Contains (regardless of intentional or impurities)	chemical products
21405	Zirconium(V) 2,2-bis(2-propenolato-methyl) butanolato, tris-2-propenolato-O	146987-99-7	Contains (regardless of intentional or impurities)	chemical products
21406	Zirconium, [P,P'-diocetyl diphosphato(2-)-O''-O'']bis(2-propenolato-, (T-4)-	147129-85-9	Contains (regardless of intentional or impurities)	chemical products
21407	1-Strychnidin-10-one, mono-(+)-2-[[[4-methylphenyl)methyl]sulfoni]benzoate	147282-84-6	Contains (regardless of intentional or impurities)	chemical products
21408	1-[[2-[[[2-Amino(hydroxyimino)methyl]biphenyl-4-yl)methyl]-2-ethoxy-1H-benzimidazole-7-carboxylic acid methyl ester	147403-65-4	Contains (regardless of intentional or impurities)	chemical products
21409	Cobaltate(1-), bis[3-[[[4-(aminosulfonyl)phenyl]azo]phenyl)methyl]azo]-4-hydroxy-N-methylbenzenesulfonamidato(2-)]-, sodium	147515-52-4	Intentional addition / 1%	chemical products
21410	Copper carbonate hydroxide	147550-61-6	Intentional addition / 1,000ppm	chemical products
21411	1H-Indole-6-boronic acid	147621-18-9	Intentional addition / 1%	chemical products
21412	1-Methyl-5-tributylstannanyl-1H-imidazole	147716-03-8	Contains (regardless of intentional or impurities)	chemical products
21413	Trisodium bis(7-acetamido-2-(4-nitro-2-oxidophenylazo)-3-sulphonato-1-naphtholato)chromate(1-)	148262-86-6	Intentional addition / 1,000ppm	chemical products
21414	Hydrazine bis(3-carboxy-4-hydroxybenzenesulfonate)	148434-03-1	Contains (regardless of intentional or impurities)	chemical products
21415	2,6-Dichloropyridine-3-boronic acid	148493-34-9	Intentional addition / 1%	chemical products
21416	Colophony resin	148499-15-4	Intentional addition / 100ppm	chemical products
21417	Benzene, mono-C10-13-alkyl derivatives, fractionation bottoms, heavy ends, sulfonated, barium salts	148520-85-8	Intentional addition / 1,000ppm	chemical products
21418	4-Methylpyridine-3-boronic acid	148546-82-1	Intentional addition / 1%	chemical products
21419	Acid Red 88-strychnine compound	148559-96-0	Contains (regardless of intentional or impurities)	chemical products
21420	Acid Red 44-strychnine compound	148559-97-1	Contains (regardless of intentional or impurities)	chemical products
21421	Acid Red 18-strychnine compound	148559-98-2	Contains (regardless of intentional or impurities)	chemical products
21422	Acid Red 41-strychnine compound	148559-99-3	Contains (regardless of intentional or impurities)	chemical products
21423	Antimony oxide (Sb2O3), mixture with chloro paraffin waxes	148709-58-4	Contains (regardless of intentional or impurities)	chemical products
21424	Benzene, 1,1'-oxybis[2,3,4,5,6-pentabromo-, mixture with antimony oxide (Sb2O3) and chloroparaffin waxes	148709-59-5	Contains (regardless of intentional or impurities)	chemical products
21425	Nickelate(4-), [C-[[[3-[[1-[3-[[2,6(or 4,6)-dichloro-5-cyano-4(or2)-pyrimidinyl]methylamino]propyl]-1,6-dihydro-2-hydroxy-4-methyl-6-oxo-3-pyridinyl]azo]-4-sulfophenyl]amino]sulfonyl]-29H,31H-phthalocyanine-C,O,C-trisulfonato(6-)]-, tetrasodium	148732-74-5	Contains (regardless of intentional or impurities)	chemical products
21426	5-Chloro-2-methylbenzeneboronic acid	148839-33-2	Intentional addition / 1%	chemical products
21427	Boron, triethyl[1,3-propanediamine-kappa N)-], (T-4)-	148861-07-8	Intentional addition / 1%	chemical products
21428	Propane, 1,1,1,3-tetrabromo-3-fluoro-	148875-95-0	Intentional addition / 100ppm	chemical products
21429	Propane, 1,1,1,3-tetrabromo-3,3-difluoro-	148875-98-3	Intentional addition / 100ppm	chemical products
21430	Beryllium, bis(benzo[1,4]quinolin-10-olato-kappa N1,kappa O10)-], (T-4)-	148896-39-3	Contains (regardless of intentional or impurities)	chemical products
21431	4-(Methylsulfonyl)phenylboronic acid	148904-88-1	Intentional addition / 1%	chemical products
21432	4-Acetylphenylboronic acid	149104-90-5	Intentional addition / 1%	chemical products
21433	2-Carboxybenzeneboronic acid	149105-19-1	Intentional addition / 1%	chemical products
21434	Chloro(ethylcyclopentadienylyl)tri(phenylphosphine)nickel(II)	149272-90-2	Contains (regardless of intentional or impurities)	chemical products
21435	C.I. Reactive Blue 15:1	149343-84-0	Intentional addition / 1,000ppm	chemical products
21436	Boronic acid, B-(3-fluoro-4-methoxyphenyl)-	149507-26-6	Intentional addition / 1%	chemical products
21437	Boronic acid, B-(3-propoxyphenyl)-	149557-18-6	Intentional addition / 1%	chemical products
21438	Chromate(3-), bis[4-[[[4-(diethylamino)-2-hydroxyphenyl]azo]-3-hydroxy-1-naphthalenesulfonato(3-)]-, trilitium	149564-65-8	Contains (regardless of intentional or impurities)	chemical products
21439	Chromate(2-), [4-[[[5-chloro-2-hydroxyphenyl]azo]-2,4-dihydro-5-methyl-3H-pyrazol-3-onato(2-)](3-)[[4,5-dihydro-3-methyl-1-(4-methylphenyl)-5-oxo-1H-pyrazol-4-yl]azo]-4-hydroxy-5-nitrobenzenesulfonato(3-)]-, lithium sodium	149564-66-9	Contains (regardless of intentional or impurities)	chemical products
21440	Chromate(2-), [2-[[[5-[[2,5-dichlorophenyl]azo]-2-hydroxyphenyl]methylene]amino]benzoato(2-)](2)-[[4,5-dihydro-3-methyl-5-oxo-1-phenyl-1H-pyrazol-4-yl]azo]-5-sulfobenzoato(3-)]-, lithium sodium	149626-00-6	Contains (regardless of intentional or impurities)	chemical products
21441	Manganese, chloro[[2,2'-[1,2-cyclohexanediy]bis(nitriolomethylidene)]bis[4,6-bis(1,1-dimethylethyl)phenolato]](2-)-N,N',O,O']-, [SP-5-13-(trans)-	149656-63-3	Contains (regardless of intentional or impurities)	chemical products
21442	1-Pyrrolidinedicarboxylic acid, 2-borono-, 1-(1,1-dimethylethyl) ester	149682-75-7	Intentional addition / 1%	chemical products
21443	Boron zinc oxide (B2Zn2O11) 7/2 hydrate	149749-63-3	Intentional addition	chemical products
21444	Glycine, N-[3-(acetylamino)-4-[[2-cyano-4-nitrophenyl]azo]phenyl]-N-(2-methoxy-2-oxoethyl)-, methyl ester	149850-30-6	Contains (regardless of intentional or impurities)	chemical products
21445	Astraphloxine, copperferrocyanide	149850-38-4	Contains (regardless of intentional or impurities)	chemical products
21446	Copper polystyrenesulfonate	149858-63-9	Intentional addition / 1,000ppm	chemical products
21447	Bifenazate	149877-41-8	Contains (regardless of intentional or impurities)	chemical products
21448	Barium, bis[2-[[2-(ethoxy-kappa O)ethoxy-kappa O]ethanolato-kappa O]-], (OC-6-12)-	149901-23-5	Intentional addition	chemical products
21449	Manganese, [[1,2-ethanediy]bis(carbamodithioato)](2-)]-, compound with [[1,2-ethanediy]bis(carbamodithioato)](2-)]zinc (1:1), mixture with N-(2,6-dimethylphenyl)-2-methoxy-N-(2-oxo-3-oxazolidinyl)acetamide	149922-80-5	Contains (regardless of intentional or impurities)	chemical products
21450	Mixture of 2-[[2-[6-anilino-3-(or 5)-cyano-5(or3)-(2-cyano-4-nitrophenyl)azo]-4-methyl-2-pyridylamino]ethoxy]ethanol	149988-45-4	Intentional addition	chemical products
21451	Cuprate(3-), [5-hydroxy-6-[[2-hydroxy-5-methyl-4-[[1-sulfo-2-naphthalenyl]azo]phenyl] azo]-2-[[4-hydroxyphenyl]azo]-1,7-naphthalenedisulfonato(5-)]-, trisodium	150206-21-6	Intentional addition / 1,000ppm	chemical products
21452	Boronic acid, B-(3-cyanophenyl)-	150255-96-2	Intentional addition / 1%	chemical products
21453	alpha-D-Glucopyranose, 6-(dihydrogen phosphate), barium salt (1:1), hydrate	150400-00-3	Intentional addition	chemical products
21454	Sodium [29H,31H-phthalocyaninato-(2-)-N29,N30,N31,N32]-((3-(N-methyl-N-(2-hydroxyethyl)amino)propyl)amino)sulfonyl-sulfonato, copper complex	150522-10-4	Contains (regardless of intentional or impurities)	chemical products
21455	Boronic acid, B-[2-[[[1,1-dimethylethyl]amino]sulfonyl]phenyl]-	150691-04-6	Intentional addition / 1%	chemical products
21456	1-Octanamine, N-[2-[[[6-(2-butoxyethoxy)-1,6-dioxohexyl]oxy]ethyl]-N,N-dimethyl-, perchlorate	151010-19-4	Intentional addition / 1,000ppm	chemical products
21457	C.I. Disperse Orange 149	151126-94-2	Intentional addition / 1,000ppm	chemical products
21458	4-Chloro-3-nitrobenzeneboronic acid	151169-67-4	Intentional addition / 1%	chemical products
21459	2,3-Dichlorophenylboronic acid	151169-74-3	Intentional addition / 1%	chemical products
21460	3,4-Dichlorophenylboronic acid	151169-75-4	Intentional addition / 1%	chemical products
21461	Pro-jet Fast CRYAN 2 Sodium	151183-29-8	Intentional addition / 1,000ppm	chemical products

(Appendix table 1) MISUMI Specified Chemical Substances

Ver.2.0.0 date of revision 5/31/2022 Misumi Corporation

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
21462	Copper, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [(3-carboxyphenyl)amino]sulfonyl sulfo derivatives, ammonium salts	151183-30-1	Intentional addition / 1,000ppm	chemical products
21463	Pro-jet Fast CYAN2 Ammonium Sodium	151183-31-2	Intentional addition / 1,000ppm	chemical products
21464	Trisodium [2-(5-[3-[[4-chloro-6-[3-[[2-(sulfoxy)ethyl]sulfonyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulfonylphenyl]-3-phenyl)-5-formazano]-4-sulfobenzoato(5-)]cuprate(3-)	151198-68-4	Intentional addition / 1,000ppm	chemical products
21465	Fatty acids, tall-oil, 2-mercaptoethyl esters, reaction products with dichlorodimethylstannane, 2-mercaptoethyl octanoate, 2-mercaptoethyl octanoate, sodium sulfide (Na2S) and trichloromethylstannane	151436-98-5	Contains (regardless of intentional or impurities)	chemical products
21466	Nickel, [29H,31H-phthalocyaninato(2-)-N29,N30,N31,N32]-, [(3-[[4-[[5-[[5-amino-3-methyl-1-phenyl-1H-pyrazol-4-yl]azo]-2-(4-disulfoxyphenyl)amino]-6-chloro-1,3,5-triazin-2-yl]amino]phenyl]amino]sulfonyl sulfo derivatives, sodium salts	151436-99-6	Contains (regardless of intentional or impurities)	chemical products
21467	4.6,9,12,22,24,27,30-Tetraetheno-15,18,21,33,33,36-diethenylidenedibenzo [k,l] [1,8,17,24] tetraoxacyclodotriacontin-1,2,19,20-tetracarboxylic acid, 3,8,13,18a,21,26,31,36a-octahydro-ion (3-), [3S-(3R*,18aR*,21R*,36aR*)]-, compound with (S)-(3-(1-methyl-2-pyrroldinyl)pyridine (1:1))	151527-31-0	Contains (regardless of intentional or impurities)	chemical products
21468	4.6,9,12,22,24,27,30-Tetraetheno-15,18,21,33,33,36-diethenylidenedibenzo [k,l] [1,8,17,24] tetraoxacyclodotriacontin-1,2,19,20-tetracarboxylic acid, 3,8,13,18a,21,26,31,36a-octahydro-ion(3-), [3R-(3R*,18aR*,21R*,36aR*)]-, compound with (S)-(3-(1-methyl-2-pyrroldinyl)pyridine (1:1))	151528-73-3	Contains (regardless of intentional or impurities)	chemical products
21469	Zirconium, [diocetyl]diphosphonato(2-)-O,O']bis(1-octanolato)-	151574-11-7	Contains (regardless of intentional or impurities)	chemical products
21470	Dicodium [7-amino-4-(hydroxy-kO)-3-[[4-[[2-(hydroxy-kappa O)-5-sulfonyl]diazenyl-kappa N1]-4,5-dimethoxyphenyl]diazenyl-kappa N2]naphthalene-2-sulfonato(4-)]cuprate(2-)	151604-82-9	Intentional addition / 1,000ppm	chemical products
21471	Zirconium, bis[[2,2'-nitritotris[ethanolato]](2-)-N,O,O']di-, trisodium	151767-62-3	Contains (regardless of intentional or impurities)	chemical products
21472	Zirconium, tri-C12-15-alkyl phosphite 1-tridecanol complexes	151789-13-8	Contains (regardless of intentional or impurities)	chemical products
21473	2-Naphthalenecarboxamide, 4-[[7-[[3-[[2-(chlorophenyl)amino]carbonyl]-2-hydroxy-1-naphthalenyl]azo]-9-oxo-9H-fluoren-2-yl]azo]-3-hydroxy-N-(3-methylphenyl)-	151798-26-4	Contains (regardless of intentional or impurities)	chemical products
21474	Bis(1-butyl-3-methylcyclopentadienyl)zirconium dichloride	151840-68-5	Contains (regardless of intentional or impurities)	chemical products
21475	Zirconate(2-), tris[[P,P'-diteridyle] diphosphato(2-)-O,O']-, dihydrogen, (OC-6-11)-	151911-65-8	Contains (regardless of intentional or impurities)	chemical products
21476	Nickel(2+), [2,2'-(2,5,9,12-tetrahydridecane-1,13-diyl)bis(pyridine)-N1,N1',S2,S2',S2'',S2''']-, bis[tetrafluoroborate(1-)]	151994-98-8	Contains (regardless of intentional or impurities)	chemical products
21477	Copper, 2-[[2-(chloroethyl)sulfonyl]-5-[[phenylhydrazono)methyl]-3-sulfobenzoic acid-diazotized 3-amino-4-hydroxy-5-[[[2-(2-sulfoxy)ethyl]sulfonyl]ethyl]amino]carbonyl]amino]benzenesulfonic acid coupling products sodium complexes	152261-41-1	Intentional addition / 1,000ppm	chemical products
21478	Cuprate(3-), [mu-5-amino-4-hydroxy-3-[[3,3'-dihydroxy-4-[[1-hydroxy-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo][1,1'-biphenyl]-4-yl]azo]-2,7-naphthalenedisulfonato(7-)]di-, trisodium	152323-95-0	Intentional addition / 1,000ppm	chemical products
21479	Zirconium, C18-32 alcohol P,P'-di-C18-32-alkyl diphosphate tri-C12-15-alkyl phosphite complexes	152323-96-1	Contains (regardless of intentional or impurities)	chemical products
21480	Bis(4-chloromethylthio)phenylsulfane	152419-82-4	Contains (regardless of intentional or impurities)	chemical products
21481	1,1'-Biphenyl, 2,4'-diethyl-	152463-74-6	Intentional addition / 1%	chemical products
21482	Poly(oxy-1,2-ethanedivyl), alpha-butyl-omega-hydroxy-, zirconium(4+) salt	152585-50-7	Contains (regardless of intentional or impurities)	chemical products
21483	[p-Sulfonyl]azo-1-naphthol-(2)-6-sulfonic acid] barium	152881-15-7	Intentional addition / 1,000ppm	chemical products
21484	Boric acid, B-(4-propyl-1,1'-biphenyl)-4-yl)-	153035-56-4	Intentional addition / 1%	chemical products
21485	(4-Chloro-2-fluoro-5-methoxyphenyl)boronic acid	153122-60-2	Intentional addition / 1%	chemical products
21486	3-[1-(3,5-Dichlorophenyl)-1-methylethyl]-3,4-dihydro-6-methyl-5-phenyl-2H-1,3-oxazin-4-one	153197-14-9	Intentional addition / 1%	chemical products
21487	Boric acid, B-[2,4-bis(trifluoromethyl)phenyl]-	153254-09-2	Intentional addition / 1%	chemical products
21488	Zirconium, hexakis(ditridecyl phosphato-O)-mu-oxo-	153382-69-5	Contains (regardless of intentional or impurities)	chemical products
21489	Carbonate 2-chloro-4-fluoro-5-nitrophenyl ethyl	153471-75-1	Intentional addition / 1%	chemical products
21490	Zirconium, [2,2-bis[[2-propenyl]oxy]methyl]-1-butanolato-O,O']tris(2-methyl-2-propenoato-O)-	153590-16-0	Contains (regardless of intentional or impurities)	chemical products
21491	4-Isobutylbenzeneboric acid	153624-38-5	Intentional addition / 1%	chemical products
21492	4-Isobutoxyphenylboronic acid	153624-44-3	Intentional addition / 1%	chemical products
21493	4-Isopropoxyphenylboronic acid	153624-46-5	Intentional addition / 1%	chemical products
21494	3-[1-(2-dimethylaminoethyl)-1H-1,2,3,4-tetrazo-5-yl]thiomethyl]-7-(4-nitrophenylthioamino)-8-oxo-5-thia-1-azabicyclo[4.2.0]octa-2-en-2-carboxylate	153653-77-1	Intentional addition / 1%	chemical products
21495	Thiamethoxam	153719-23-4	Contains (regardless of intentional or impurities)	chemical products
21496	Calcium titanium manganese oxide	153728-36-0	Contains (regardless of intentional or impurities)	chemical products
21497	N-[(1R)-1-phenylethyl]methyloxy acetate	153831-92-6	Contains (regardless of intentional or impurities)	chemical products
21498	Barium, benzoate neodecanoate tall-oil fatty acid complexes	153890-20-1	Intentional addition	chemical products
21499	Heptane, 1,7-dichloro-4-(3-chloropropyl)-	154120-66-8	Intentional addition / 1,000ppm	chemical products
21500	Propane, 2,2-dibromo-1,3-difluoro-	154193-90-5	Intentional addition / 1,000ppm	chemical products
21501	Boric acid, B-[(1E)-2-(4-chlorophenyl)ethenyl]-	154230-29-2	Intentional addition / 1%	chemical products
21502	Cuprate(4-), [2-[[[3-[[4-fluoro-6-[[phenyl]2-[[2-(sulfoxy)ethyl]sulfonyl]ethyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-kappa O)-5-sulfonyl]azo-kappa N2]phenylmethyl]azo-kappa N1]-4-sulfo-2-naphthalenyl]azo-kappa O]-, tetrahydrogen	154240-34-3	Intentional addition / 1,000ppm	chemical products
21503	Silver sodium zirconium phosphate	154339-84-1	Contains (regardless of intentional or impurities)	chemical products
21504	Hydrogen bis[4-[[3,5-dichloro-2-hydroxyphenyl]azo]-3-hydroxy-2-naphthalenylidato(2-)]chromate(1-)	154857-50-8	Contains (regardless of intentional or impurities)	chemical products
21505	Ethanol, 2,2'-oxybis-, zirconium(4+) salt (4:1)	154906-09-9	Contains (regardless of intentional or impurities)	chemical products
21506	Emamectin benzoate	155569-91-8	Intentional addition / 1%	chemical products
21507	Sodium Lmu-[[2,2'-[[1-methyl-1,2-ethanedivyl]bis(6-fluoro-1,3,5-triazine-4,2-diylo)imino]-2-hydroxy-5-sulfo-3,1-phenylene]azo]phenylmethylene]azo]]bis[4-sulfobenzoate(6-)](10)-dicuprate(6-)	155613-89-1	Intentional addition / 1,000ppm	chemical products
21508	Octabromo-1,1,3-trimethyl-3-phenyl indan	155613-93-7	Contains (regardless of intentional or impurities)	chemical products
21509	Cobalt(2+) chloride 6-phenyl-2,3,5,6-tetrahydroimidazo[2,1-b][1,3]thiazole (1:2:2)	155737-56-7	Intentional addition / 1%	chemical products
21510	Nickel(2+) chloride 6-phenyl-2,3,5,6-tetrahydroimidazo[2,1-b][1,3]thiazole (1:2:2)	155737-57-8	Contains (regardless of intentional or impurities)	chemical products
21511	Nickel(II), 5,9,14,18,23,27,32,36-octabutoxy-2,3-naphthalocyanine	155773-70-9	Contains (regardless of intentional or impurities)	chemical products
21512	Nickel(II), 1,4,8,11,14,18,22,25-octa-n-butoxy-29H,31H-phthalocyanine	155773-71-0	Contains (regardless of intentional or impurities)	chemical products
21513	Copper(2+) chloride 6-phenyl-2,3,5,6-tetrahydroimidazo[2,1-b][1,3]thiazole (1:2:2)	155835-80-6	Intentional addition / 1,000ppm	chemical products
21514	Antimony ethylene glycolate	155916-06-6	Contains (regardless of intentional or impurities)	chemical products
21515	Silver sodium hydrogen zirconium phosphate	155925-27-2	Contains (regardless of intentional or impurities)	chemical products
21516	Boric acid, B-(3,5-difluorophenyl)-	156545-07-2	Intentional addition / 1%	chemical products
21517	4-Benzoyloxy-2,3-difluorobenzeneboric acid	156635-87-9	Intentional addition / 1%	chemical products
21518	6-Methoxy-2-naphthaleneboric acid	156641-98-4	Intentional addition / 1%	chemical products
21519	3-Benzoyloxyphenylboronic acid	156682-54-1	Intentional addition / 1%	chemical products
21520	Boric acid, B-(2,3-difluoro-4-pentyloxy)phenyl]-	156684-91-2	Intentional addition / 1%	chemical products
21521	Zirconium, chloro citrate hydroxy (-)-lactate ammonium complexes	156738-28-2	Contains (regardless of intentional or impurities)	chemical products
21522	Cuprate(4-), [2-[[[3-[[4-fluoro-6-[[phenyl]2-[[2-(sulfoxy)ethyl]sulfonyl]ethyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulfonyl]azo]phenylmethyl]azo]-4-sulfobenzoate(6-)]-, sodium	156830-72-7	Intentional addition / 1,000ppm	chemical products
21523	Dipotassium dihydrogen antimonate (K2H2Sb2O7)	157368-22-4	Intentional addition / 1,000ppm	chemical products
21524	Boron, difluoro[3,4,5-trimethyl-1-alpha-(3,4,5-trimethyl-2H-pyrrol-2-ylidene-kappa N)-1H-pyrrole-2-acetonitrilo]-kappa N1]-, (T-4)	157410-23-6	Intentional addition / 1%	chemical products
21525	Trisodium 5-[4-chloro-6-[2-(2,6-dichloro-5-cyanopyrimidine-4-ylamino)propylamino]-[1,3,5]-triazin-2-yl]amino]-4-hydroxy-3-(1-sulfonylnaphthalene-2-yl)azo]naphthalene-2,7-disulfonate	157627-97-9	Intentional addition	chemical products
21526	Alcohols, C14-18, ethoxylated	157707-41-0	Intentional addition / 1%	chemical products
21527	2-Fluoro-3-(trifluoromethyl)benzeneboric acid	157834-21-4	Intentional addition / 1%	chemical products
21528	Chromate(1-), diaquabis[ethanedioato(2-)-O,O']-, ammonium	158086-59-0	Contains (regardless of intentional or impurities)	chemical products
21529	2,4,6-Trimethylbenzenesulfonamide	158091-65-7	Contains (regardless of intentional or impurities)	chemical products
21530	4-(2-Chlorophenyl)-N-cyclohexyl-N-ethyl-4,5-dihydro-5-oxo-1H-tetrazole-1-carboxamide	158237-07-1	Intentional addition / 1%	chemical products
21531	Cuprate(4-), [2-[[[4-[[2-(chloroethyl)sulfonyl]phenyl]2-hydroxy-5-sulfo-3-[[[2-[[2-(sulfoxy)ethyl]sulfonyl]sulfonyl]ethyl]amino]carbonyl]amino]phenyl]azo]benzoato(6-)]-, tetrasodium	158640-34-7	Intentional addition / 1,000ppm	chemical products
21532	Strychnidin-10-one, mono[[OC-6-21(O)-[2-bis(carboxymethyl)amino]-1-[[bis(carboxymethyl)amino]methyl]ethyl]pentanoato(4-)]cobaltate(1-)]-, hexahydrate	158646-92-5	Contains (regardless of intentional or impurities)	chemical products
21533	Ferrate(1-), (acetate-O)[2-hydroxy-5-[[4-[[4-nitro-2-sulfonyl]amino]phenyl]azo]benzoato(3-)-O1,O2]-, sodium	158800-95-4	Intentional addition / 1%	chemical products
21534	Cuprate(4-), [6-[[[2,3-dichloro-6-quinoxaliny]carbonyl]amino]-3-[[4-[[2,5-disulfonyl]azo]-2-hydroxy-5-methylphenyl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(6-)]-], ammonium potassium sodium, compounds with diethanolamine	158852-56-3	Intentional addition / 1,000ppm	chemical products
21535	Cuprate(4-), [6-[[[2,3-dichloro-6-quinoxaliny]carbonyl]amino]-3-[[4-[[2,5-disulfonyl]azo]-2-hydroxy-5-methylphenyl]azo]-4-hydroxy-2,7-naphthalenedisulfonato(6-)]-], ammonium potassium sodium, compounds with diethanolamine	158852-57-4	Intentional addition / 1,000ppm	chemical products
21536	3-Fluoro-5-(trifluoromethyl)benzeneboric acid	159020-59-4	Intentional addition / 1%	chemical products
21537	Boric acid, B-[2-fluoro-4-(trans-4-propylcyclohexyl)phenyl]-	159119-10-5	Intentional addition / 1%	chemical products
21538	A mixture of: bis[4-diphenylsulfoniumphenyl]sulfide bis(hexafluoroantimonate); thiophenoxypentylsulfonium hexafluoroantimonate	159120-95-3	Contains (regardless of intentional or impurities)	chemical products
21539	4-(tert-Butyldimethylsilyloxy)phenylboronic acid	159191-56-7	Intentional addition / 1%	chemical products
21540	Copper, [N,N,N'-tris(3-dimethylamino)propyl]-29H,31H-phthalocyaninetrisulfonamidato(2-)-N29,N30,N31,N32]-, reaction products with 1,3-dichloro-2-propanol, lactates	159518-91-9	Intentional addition / 1,000ppm	chemical products
21541	Chromium, acetylated 6-amino-4-hydroxy-2-naphthalenesulfonic acid-p-cresol-diazotized 2-hydroxy-5-nitrobenzenesulfonic acid-diazotized 4-hydroxy-3-nitrobenzenesulfonic acid coupling products ammonium potassium sodium complexes	159518-93-1	Intentional addition / 1,000ppm	chemical products
21542	4-Isopropylpyridine(N-B)methyl(diphenyl)borane	159565-88-5	Intentional addition / 1%	chemical products
21543	Cuprate(3-), [2-[[[C-(aminosulfonyl)-C,C-disulfo-29H,31H-phthalocyanin-C-yl]-N29,N30,N31,N32]sulfonyl]amino]-5-[[6-chloro-2,6-difluoro-4-pyrimidinyl]amino]benzoato(5-)]-, trisodium	159574-70-6	Intentional addition / 1,000ppm	chemical products
21544	Cuprate(4-), [7-[[[4-[[5-[[5-chlorodifluoro-2(or 4)-pyrimidinyl]amino]-2-methoxy-3-sulfonyl]azo]-2-(hydroxy-kappa O)phenyl]azo-kappa N1]-8-(hydroxy-kappa O)-1,3,6-naphthalenetrisulfonato(6-)]-], potassium sodium (5:4:16)	159574-71-7	Intentional addition / 1,000ppm	chemical products
21545	Chromate(5-), bis[4-hydroxy-7-[[2-hydroxy-1-naphthalenyl]azo]-3-[[2-hydroxy-3-nitro-5-sulfonyl]azo]-2-naphthalenesulfonato(4-)]-, pentasodium	159574-72-8	Contains (regardless of intentional or impurities)	chemical products
21546	Cuprate(3-), [mu-[[4-[[4-[[6-(4,6-dichloro-1,3,5-triazin-2-yl)amino]-1-hydroxy-3-sulfo-2-naphthalenyl]azo]-3,3'-dihydroxy[1,1'-biphenyl]-4-yl]azo]-3-hydroxy-2,7-naphthalenedisulfonato(7-)]di-, trisodium	159574-73-9	Intentional addition / 1,000ppm	chemical products
21547	Cuprate(3-), [3-[[2-amino-5-hydroxy-7-sulfo-1-naphthalenyl]azo]-2-hydroxy-5-sulfo-2-naphthalenyl]azo]-, trisodium	159604-93-0	Intentional addition / 1,000ppm	chemical products
21548	(2,2-(3,3-Dioxidobiphenyl-4,4'-diyl)diazo)bis(6-(4-(3-(diethylamino)propylamino)-6-(3-(diethylamino)propylamino)-1,3,5-triazin-2-ylamino)-3-sulfonato-1-naphtholato)dicopper(II) acetate lactate	159604-94-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
21549	Cuprate(3-), [mu]-[4-[[[4-[[4-chloro-1,6-dihydro-6-oxo-1,3,5-triazin-2-yl)amino]-1-(hydroxy-kappa.O)-3-sulfo-2-naphthalenyl]azo-kappa.N1]-3,3'-di(hydroxy-kappa.O)]1,1'-biphenyl]-4-yl]azo-kappa.N1]-3-(hydroxy-kappa.O)-2,7-naphthalenedisulfonato(7-)]di-, trisodium	159604-96-3	Intentional addition / 1,000ppm	chemical products
21550	Decane, 3,5,7-trichloro-	159715-71-6	Intentional addition / 1,000ppm	chemical products
21551	Zirconium, hydroxy(4-methyl-gamma-oxobenzenebutanoato-O.alpha.)oxo-, compound with 4-methyl-gamma-oxobenzenebutanoic acid	159793-35-8	Contains (regardless of intentional or impurities)	chemical products
21552	Thieno[3,2-b]thiophene-2-boronic acid	160032-40-6	Intentional addition / 1%	chemical products
21553	2-Perfluoroalkyl(C8)ethyl acrylate-alkyl(C16-18)acrylate copolymers	160336-09-4	Intentional addition / 1,000ppm	chemical products
21554	N-[[6-Chloro-3-pyridyl)methyl]methyl]-N'-cyano-N-methylmethanimidamide	160430-64-8	Intentional addition	chemical products
21555	Bis(2-ethylhexyl) tin oxide polymer	160529-70-2	Intentional addition / 1,000ppm	chemical products
21556	4-Chloro-2-fluorobenzenboronic acid	160591-91-3	Intentional addition / 1%	chemical products
21557	Hafnium titanium carbide	160614-47-1	Intentional addition / 1%	chemical products
21558	Molybdenum dithiocarbamate	160673-82-5	Intentional addition / 1%	chemical products
21559	Chromate(3-), bis[2-[[[4,5-dihydro-5-oxo-1-(4-sulfonyl)-1H-pyrazol-4-yl]azo]benzoato(3-)]-, trisodium	160673-88-1	Contains (regardless of intentional or impurities)	chemical products
21560	Gallium bromate	160709-58-0	Intentional addition / 1%	chemical products
21561	Bis-[N-[[3-(dibenzylamino)propyl]sulfonyl]disulfate copper phthalocyanine disodium salt	160709-61-5	Intentional addition / 1,000ppm	chemical products
21562	Dimethyltin isooctyl mercaptoacetate	160709-63-7	Contains (regardless of intentional or impurities)	chemical products
21563	Butanedioic acid monoalkyl(C12-24) derivatives, copper(2+) salts	160798-98-1	Intentional addition / 1,000ppm	chemical products
21564	(2,4-Dihydroxyphenyl)(4-dimethylaminophenyl)methane	160818-07-5	Contains (regardless of intentional or impurities)	chemical products
21565	Tetrasodium 4,4'-dihydroxy-3,3'-bis(2-hydroxy-5-sulfonatophenylazo)-7,7'-(6-anilino-1,3,5-triazine-2,4-diyldimino)di-2-naphthalenesulfonate copper(II) chelates (2:1)	160828-78-4	Intentional addition / 1,000ppm	chemical products
21566	Trisodium bis[2-[[[2,4-dihydroxy-3 or 5-[[2-methyl-4-sulfonyl]azo]phenyl]azo]benzoato(3-)]chromate(3-)	160867-07-2	Contains (regardless of intentional or impurities)	chemical products
21567	Chromate(3-), [4-hydroxy-3-[[2-hydroxy-3,5-dinitrophenyl]azo]-6-[[3-hydroxy-5-methylphenyl)sulfonyl]amino]-2-naphthalenesulfonato(3-)](3-ethoxy-4-[2-methoxy-1-naphthalenyl]azo)-7-nitro-1-naphthalenesulfonato(3-), trihydrogen	160869-69-2	Contains (regardless of intentional or impurities)	chemical products
21568	Dihydrogen [4-hydroxy-3-[[5-hydroxy-3-methyl-1-(4-methylphenyl)-4-pyrazolyl]azo]-5-nitrobenzenesulfonato(3-)](4-[[2-hydroxy-4-nitrophenyl]azo]-3-methyl-5-pyrazolono(2-)]chromate(2-)	160869-74-9	Contains (regardless of intentional or impurities)	chemical products
21569	Tetrasodium [7-[[[6-[[5-chloro-2-fluoro-6-methyl-4-pyrimidinyl)amino]-1-hydroxy-3-sulfo-2-naphthyl]azo]-8-hydroxy-1,3,5-naphthalenesulfonato(6-)]cuprate(4-)	160869-75-0	Intentional addition / 1,000ppm	chemical products
21570	(2,3-Dibromopropionylamino)-4-hydroxy-3-(2-hydroxy-6-nitro-4-sulfo-1-naphthylazo)-2-naphthalenesulfonic acid with 7-(2,3-dibromopropionylamino)-4-hydroxy-3-(2-hydroxy-5-nitrophenylazo)-2-naphthalenesulfonic acid (1:2) chromium(III) chelates tetrasodium salt	160901-47-3	Contains (regardless of intentional or impurities)	chemical products
21571	2-Alpha-[3-[[4-Chloro-6-[N-ethyl-4-[[2-(hydroxysulfonyl)ethylsulfonyl]anilino]-1,3,5-triazin-2-ylamino]-2-hydroxy-5-sulfonyl]azobenzylidene hydrazino]-4-sulfo]benzoic acid copper(II) chelates tripotassium salt	160901-48-4	Intentional addition / 1,000ppm	chemical products
21572	2-[[[4-[[4-Anilino-6-[4-[[4-(2-carboxyphenylazo)-5-hydroxy-3-methyl-1-pyrazolyl]-2-sulfonyl]-3-sulfoanilino]-1,3,5-triazin-2-ylamino]-2-sulfonyl]-3-sulfonyl]-5-hydroxy-3-methyl-4-pyrazolyl]azo]-5-sulfo]benzoic acid copper(II) chelates pentasodium salt	160901-54-2	Intentional addition / 1,000ppm	chemical products
21573	Sulfuric acid monoethyl ester, vanadium salt	160935-26-2	Intentional addition / 1%	chemical products
21574	Trisodium [4-[[[4-[[1-hydroxy-3-sulfo-7-phenylamino]-2-naphthyl]azo]hydroxymethoxy[1,1'-biphenyl]-4-yl]azo]-3-hydroxynaphthalene-2,7-disulfonato(5-)]cuprate(3-)	160935-33-1	Intentional addition / 1,000ppm	chemical products
21575	Zirconium aliphatic carboxylate(C7-50)	160985-30-0	Contains (regardless of intentional or impurities)	chemical products
21576	Reaction product of diethyltin oxide with silicic acid tetraethyl ester homopolymer	160994-54-7	Intentional addition / 1,000ppm	chemical products
21577	Alcohols, C12-16, C12-15-rich, ethoxylated	161025-21-4	Intentional addition / 1%	chemical products
21578	Alcohols, C10-16, C12-13-rich, ethoxylated	161025-22-5	Intentional addition / 1%	chemical products
21579	Poly[1,1-bis(3,3,4,4,5,6,6,7,7,8,8,9,9,10,10,10-heptafluorodecyl)-1,3,1,3-disiloxanediylidene]-1,3-	161045-59-6	Intentional addition / 1,000ppm	chemical products
21580	Tetrafluoroethylene, oxidized, oligomers, reduced, decarboxylated	161075-02-1	Intentional addition / 1%	chemical products
21581	Tetraalkyl(C3-10)zirconium	161075-36-1	Contains (regardless of intentional or impurities)	chemical products
21582	Alcohols, C12-16, branched, ethoxylated	161133-69-3	Intentional addition / 1%	chemical products
21583	Hafnium(IV) trifluoromethanesulfonate	161337-67-3	Intentional addition / 1%	chemical products
21584	(S)-N-(2,3-Epoxypropyl)phthalimide	161596-47-0	Contains (regardless of intentional or impurities)	chemical products
21585	(4-Chloro-3-methylphenyl)boronic acid	161950-10-3	Intentional addition / 1%	chemical products
21586	2,6-Difluorophenylboronic acid	162101-25-9	Intentional addition / 1%	chemical products
21587	2-Fluoro-4-methoxybenzenboronic acid	162101-31-7	Intentional addition / 1%	chemical products
21588	4-Methylthiophene-2-boronic acid	162607-15-0	Intentional addition / 1%	chemical products
21589	5-Chloro-2-thiopheneboronic acid	162607-18-3	Intentional addition / 1%	chemical products
21590	5-Methyl-2-thiopheneboronic acid	162607-20-7	Intentional addition / 1%	chemical products
21591	4-Methoxymethylbenzenboronic acid	162662-27-3	Intentional addition / 1%	chemical products
21592	Lithium manganese nickel oxide	162684-16-4	Contains (regardless of intentional or impurities)	chemical products
21593	2-Methoxypyridine-5-boronic acid	163105-89-3	Intentional addition / 1%	chemical products
21594	2-Methoxypyridine-3-boronic acid	163105-90-6	Intentional addition / 1%	chemical products
21595	Tin, dibutyl,1,2-ethanediamine-N,N'-bis(monisoctyl-2-butenedioato-O)-	163206-28-8	Contains (regardless of intentional or impurities)	chemical products
21596	Rhodium iodide	163207-16-7	Intentional addition / 1%	chemical products
21597	Cuprate(1-), [C,C,C,C,C,C,C,C,C,C,C,C,C,C-dodecachloro-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, hydrogen	163237-16-9	Intentional addition / 1,000ppm	chemical products
21598	3-(1-Benzothien-2-yl)-5,6-dihydro-1,4,2-oxathiazine 4-oxide	163269-30-5	Contains (regardless of intentional or impurities)	chemical products
21599	2-Methylbenzenboronic acid, propanediol cyclic ester	163517-56-4	Intentional addition / 1%	chemical products
21600	5-Fluoro-2-methylbenzenboronic acid	163517-62-2	Intentional addition / 1%	chemical products
21601	Copper, [2-(29H,31H-phthalocyanin-2-ylmethyl)-1H-isoindole-1,3(2H)-dionato(2-)-N29,N30,N31,N32]-, (SP-4-2)-	163557-38-8	Intentional addition / 1,000ppm	chemical products
21602	2-(2-Cyanophenyl thio)benzoic acid	163725-12-0	Intentional addition	chemical products
21603	6-(1,4-Benzodioxanyl)boronic acid	164014-95-3	Intentional addition / 1%	chemical products
21604	Trisodium (8-acetamido-2-(4-(6-benzamido-1-oxido-3-sulfonato-2-naphthylazo)-3,3'-dioxidobiphenyl-4-yl)azo)-3,6-disulfonato-1-naphtholato)dicropper(II)	164058-22-4	Contains (regardless of intentional or impurities)	chemical products
21605	Arsenic acid (H3AsO4), monopotassium salt, 1/5 hydrate	164170-84-7	Intentional addition / 1,000ppm	chemical products
21606	beta.-[4-(trans-4-Ethylcyclohexyl)phenyl]boronic acid	164220-57-9	Intentional addition / 1%	chemical products
21607	Boronic acid, B-1-pyrenyl-	164461-18-1	Intentional addition / 1%	chemical products
21608	Pentasodium (8-(4-chloro-6-(4-(2-(sulfonatoxy)ethylsulfonyl)anilino)-1,3,5-triazin-2-ylamino)-3,4',6,8'-tetrasulfonato-2,2'-azodinaphthalato)copper(II)	164578-05-6	Intentional addition / 1,000ppm	chemical products
21609	trans-3-Methoxy-1-propenylboronic acid pinacol ester	165059-42-7	Intentional addition / 1%	chemical products
21610	4-Propyl-1,3,2-dioxathiane-2,2-dioxide	165108-64-5	Contains (regardless of intentional or impurities)	chemical products
21611	1,5-Trisiloxanediol, 3-(3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10-heptafluorodecyl)-1,1,3,5,5-pentamethyl-	165320-75-2	Intentional addition / 100ppm	chemical products
21612	Ethanaminium, N-[4-[[4-(diethylamino)phenyl][4-(ethylamino)-1-naphthalenyl]methylenelene]-2,5-cyclohexadien-1-ylidene]-N-ethyl-, copper(2+) (OC-6-11)-hexakis(cyano-C)ferate(4-)(2:1:1)	165373-75-1	Intentional addition / 1,000ppm	chemical products
21613	4-(2-Carboxyethyl)benzenboronic acid	166316-48-9	Intentional addition / 1%	chemical products
21614	2-Fluoro-5-methylbenzenboronic acid	166328-16-1	Intentional addition / 1%	chemical products
21615	1,1,5,5-Tetrakis[4-(diethylamino)phenyl]-1,4-pentadien-3-ylum butyl(tri)phenylborate	166528-82-5	Intentional addition / 1%	chemical products
21616	Xanthylum, 3,6-bis(diethylamino)-9-[[2-(ethoxycarbonyl)phenyl]-], copper(2+) (OC-6-11)-hexakis(cyano-C)ferate(4-)(2:1:1)	167614-40-6	Intentional addition / 1,000ppm	chemical products
21617	Cuprate(1-), [C,C,C-tris[[[3-(2-hydroxyethyl)methylamino]propyl]amino]sulfonyl]-29H,31H-phthalocyanine-C-sulfonato(3-)-N29,N30,N31,N32]-, sodium	167614-41-7	Intentional addition / 1,000ppm	chemical products
21618	Doyle dirhodium catalyst - Rh2(AS-MEOX)4	167693-36-9	Contains (regardless of intentional or impurities)	chemical products
21619	3-Chloro-1,1-bis(4-tolyl)prop-1-ene	167859-39-4	Contains (regardless of intentional or impurities)	chemical products
21620	Copper(3+), [[4,4',4''-(29H,31H-phthalocyanine-C,C,C-triyltris(methylene)tris[1,3,5-trimethyl-1H-imidazolium]](2-)-N29,N30,N31,N32]-, methyl sulfate sulfate	167972-58-9	Intentional addition / 1,000ppm	chemical products
21621	Boronic acid, B-(3,4-difluorophenyl)-	168267-41-2	Intentional addition / 1%	chemical products
21622	3-Fluoro-4-methylphenylboronic acid	168267-99-0	Intentional addition / 1%	chemical products
21623	Boronic acid, B-[2-(methylthio)phenyl]-	168618-42-6	Intentional addition / 1%	chemical products
21624	Cuprate(4-), [[3,3',3''-[[C-sulfo-29H,31H-phthalocyanine-C,C,C-triyl-kappa.N29,kappa.N30,kappa.N31,kappa.N32]tris(sulfonylimino)]tris[benzoato]](6-)]-, tetraammonium	168850-75-7	Intentional addition / 1,000ppm	chemical products
21625	Barium benzyl mercaptide	169797-19-7	Intentional addition / 1,000ppm	chemical products
21626	Barium bis(2,2,6,6-tetramethyl-3,5-heptanedionate) bis 1,10-phenanthroline	170717-12-1	Intentional addition	chemical products
21627	Barium 9-(2,4-disulfonylphenyl)-3-diethylimino-6-diethylimino-3H-xanthone	170831-56-8	Intentional addition / 1,000ppm	chemical products
21628	2-Fluoro-4-methylphenylboronic acid	170981-26-7	Intentional addition / 1%	chemical products
21629	Benzene, ethenyl-, ar-bromo derivatives, polymers with propene, graft	171091-06-8	Intentional addition / 900ppm	chemical products
21630	Acetamide, 2-[2-chloro-5-(chloroacetyl)-4-fluorophenyl]-N-methyl-	171104-21-5	Intentional addition / 1%	chemical products
21631	(1S,2S)-N-N-Bis[3-oxo-2-(2,4,6-trimethylbenzoyl)butylidene]-1,2-diphenylethylenediaminato cobalt(II)	171200-71-8	Intentional addition / 1%	chemical products
21632	4-(Methoxycarbonyl)benzenboronic acid, pinacol ester	171364-80-0	Intentional addition / 1%	chemical products
21633	4-Nitrophenylboronic acid pinacol ester	171364-83-3	Intentional addition / 1%	chemical products
21634	[2-[1-3-[[4-Fluoro-6-[[[2-(vinylsulfonyl)ethoxy]ethylamino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-5-sulfonyl]phenyl]-3-phenyl-5-formazano]-4-sulfo]benzoato(4-)]cuprate(2-)	171727-36-9	Intentional addition / 1,000ppm	chemical products
21635	[2-[1-2-hydroxy-3-[[4-[[2-sulfoethyl]amino]-6-[[3-[[2-(sulfoxyethyl)sulfonyl]anilino]-1,3,5-triazin-2-yl]amino]-5-sulfonyl]-3-phenyl-5-formazano]-4-sulfo]benzoato(6-)]cuprate(4-)	171727-39-2	Intentional addition / 1,000ppm	chemical products
21636	Copper, [[2-[[1,2-cyclohexanediyl]bis(nitro)ethylidene]bis[phenolato]](2-)-N,N,O,O']-(SP-4-2)-	171866-24-3	Contains (regardless of intentional or impurities)	chemical products
21637	Mixture of the tetra(2-ethylhexylamino) salt and the monosodium salt of the 2:1 chromium(III) complex of 2-(2'-hydroxy-5-nitrophenylazo)-1-hydroxy-8-aminonaphthalene-3,6-disulfonic acid	171966-37-3	Contains (regardless of intentional or impurities)	chemical products
21638	2-Ethylhexyloxypropylamine salt of the 2:1 chromium complex of 2-(2'-hydroxy-5-nitrophenylazo)-1-hydroxy-7-aminonaphthalene-3-sulfonic acid	171966-38-4	Contains (regardless of intentional or impurities)	chemical products
21639	Dehydrodiethylamine salt of the 2:1 chromium complex of 1-(2-hydroxy-1-naphthylazo)-2-hydroxy-4-sulfo-6-nitronaphthalene	171966-39-5	Contains (regardless of intentional or impurities)	chemical products
21640	Octadecylamine of the 2:1 chromium complex 1-(2-hydroxy-1-naphthylazo)-2-hydroxy-6-nitronaphthalene-4-sulfonic acid	171966-40-8	Contains (regardless of intentional or impurities)	chemical products
21641	Octoxypropylamine salt of the 2:1 chromium complex of 1-(4-nitro-6-sulfo-2-hydroxynaphthylazo)-2-hydroxynaphthalene	171966-42-0	Contains (regardless of intentional or impurities)	chemical products
21642	Cyclohexylamine salt of the 2:1 chromium complex of 1-(2-hydroxynaphthyl-1-azo)-2-hydroxy-6-nitronaphthalene-4-sulfonic acid	171966-43-1	Contains (regardless of intentional or impurities)	chemical products
21643	1,3-Diphenylguanidine salt of the 2:1 chromium complex of 1-(2-hydroxynaphthyl-1-azo)-2-hydroxy-6-nitronaphthalene-4-sulfonic acid	171966-44-2	Contains (regardless of intentional or impurities)	chemical products
21644	Chromium complex of 1-(2-hydroxy-5-methylsulfonylphenyl) azo-2-naphthol and 1-(2-hydroxy-3-acetylaminophenyl)azo-8-acetylamine-2-naphthol	171966-45-3	Contains (regardless of intentional or impurities)	chemical products





#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
21737	Cuprate(4-), [2-[[[3-[[4-chloro-6-[[4-[[2,3-dibromo-1-oxopropyl]amino]-2-sulfonyl]amino]-1,3,5-triazin-2-yl]amino]-2-hydroxy-kappa-O]-5-sulfonyl]azo-kappa-N2]phenylmethyl]azo-kappa-N1]-4-sulfobenzoato(6-)-kappa-O]-, sodium	187547-44-0	Intentional addition / 1,000ppm	chemical products
21738	(-)-1,2-Bis[(2R,5R)-dimethylphospholano]benzene(cyclooctadiene)rhodium(I) trifluoromethanesulfonate	187682-63-9	Contains (regardless of intentional or impurities)	chemical products
21739	4-Methylbenzenesulfonic acid 3-(methylthio)propyl ester	187722-18-5	Contains (regardless of intentional or impurities)	chemical products
21740	1-Bromo-3-(1,1-dimethylethyl)-5-methyl-2-(propa-2-en-1-yl)oxy]benzene	188021-38-7	Contains (regardless of intentional or impurities)	chemical products
21741	Cobalt, [[2,2'-[[18,2S)-1,2-cyclohexanedibis[[nitro-kappa-N]methylidene]bis[4,6-bis(1,1-dimethylethyl)phenolato-kappa-O]](2-)-], (SP-4-2)-	188264-84-8	Intentional addition / 1%	chemical products
21742	1,1'-Thiobis(2,3-epithiopropane)	188829-97-2	Intentional addition / 1%	chemical products
21743	Cobalt manganese nickel hydroxide	189139-63-7	Contains (regardless of intentional or impurities)	chemical products
21744	Cuprate(3-), [2-[[[2-(hydroxy-kappa-O)-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo-kappa-N2]phenylmethyl]azo-kappa-N1]-4-sulfobenzoato(5-)-kappa-O]-, trisodium	189240-43-5	Intentional addition / 1,000ppm	chemical products
21745	Carbonic acid, cobalt(2+) salt (1:1), hexahydrate	189279-89-8	Intentional addition / 1%	chemical products
21746	(Oxidized) carboxylic acids (C3-22) Cu(1+) salts	188986-42-2	Intentional addition / 1,000ppm	chemical products
21747	Copper, O,O'-dialkyl (C3-6) phosphorodithioate	190280-64-9	Intentional addition / 1,000ppm	chemical products
21748	Chromate(2-), [3-hydroxy-4-[[2-hydroxy-1-naphthalenyl]azo]-7-nitro-1-naphthalenesulfonato(3-)]-[1-[[2-hydroxy-5-nitrophenyl]azo]-2-naphthalenolato(2-)-], lithium	190525-00-9	Contains (regardless of intentional or impurities)	chemical products
21749	2-Nitrophenylboronic acid pinacol ester	190788-59-1	Intentional addition / 1%	chemical products
21750	Boric acid, B-(2,2-difluoro-1,3-benzodioxol-5-yl)-	190903-71-0	Intentional addition / 1%	chemical products
21751	Quinoline-3-boronic acid	191162-39-7	Intentional addition / 1%	chemical products
21752	Boric acid, B-(1-methyl-1H-indol-2-yl)-	191162-40-0	Intentional addition / 1%	chemical products
21753	Cobaltate(5-), bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-hydroxy-5-nitrophenyl]azo]-2,7-naphthalenedisulfonato(4-)-], lithium sodium	191233-75-7	Intentional addition / 1%	chemical products
21754	Chromium, aqua propionate complex	191358-82-4	Intentional addition / 1,000ppm	chemical products
21755	Copolymer of 2-propenal and propane-1,2-diol	191546-07-3	Intentional addition / 1,000ppm	chemical products
21756	3,5-Dimethoxyphenylboronic acid	192182-54-0	Intentional addition / 1%	chemical products
21757	4-Isquinoline boronic acid	192182-56-2	Intentional addition / 1%	chemical products
21758	Cuprate(2-), [2-[[4-[[2,4-dihydroxy-5-[[3-amino-5-sulfonyl]azo]phenyl]azo]phenyl]-6-(2-hydroxy-5-sulfonyl)-7-benzothiazolesulfonato(4-)-]ammonium sodium	192230-32-3	Intentional addition / 1,000ppm	chemical products
21759	Amine, (C12-14)-tert alkyl, chromate(1-), bis[3-[[4-[[5-[[1,1-dimethylpropyl]-2-hydroxy-3-nitrophenyl]azo]-4,5-dihydro-3-methyl-5-oxo-1H-pyrazol-1-yl]benzolsulfonamidato(2-)-]	192682-33-2	Contains (regardless of intentional or impurities)	chemical products
21760	Cuprate(4-), [3-[[[8-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-1-(hydroxy-kappa-O)-3,6-disulfo-2-naphthalenyl]azo-kappa-N1]-4-(hydroxy-kappa-O)-1,5-naphthalenedisulfonato(6-)-], lithium sodium	192726-54-8	Intentional addition / 1,000ppm	chemical products
21761	Aluminum cobalt lithium nickel oxide	193214-24-3	Contains (regardless of intentional or impurities)	chemical products
21762	Cobalt lithium manganese nickel oxide	193215-53-1	Contains (regardless of intentional or impurities)	chemical products
21763	Cobalt, butadiene 2-ethylhexanoate isobutyl aluminum complexes	193293-67-3	Intentional addition / 1%	chemical products
21764	1-Butanaminium, N,N,N-tributyl-, (SP-4-1)-bis[4-[[3,4-di(mercapto-kappa-S)phenyl]sulfonyl]morpholino(2-)]cuprate(1-)(1:1)	194554-01-3	Intentional addition / 1,000ppm	chemical products
21765	1-Butanaminium, N,N,N-tributyl-, (SP-4-2)-bis[4-[[3,4-di(mercapto-kappa-S)phenyl]sulfonyl]morpholino(2-)]cuprate(1-)(1:1)	194614-54-5	Intentional addition / 1,000ppm	chemical products
21766	Oxiran-2-ylmethyl diphenylphosphinate	195726-46-6	Contains (regardless of intentional or impurities)	chemical products
21767	2,5-Bis(trifluoromethyl)benzenboronic acid	196083-18-8	Intentional addition / 1%	chemical products
21768	1,3-Phenylboronic acid, bis(pinacol) ester	196212-27-8	Intentional addition / 1%	chemical products
21769	4-Methoxy-3-biphenylamine hydrochloride	197147-24-3	Intentional addition / 1%	chemical products
21770	2,3,5,6-Tetramethylphenylboronic acid	197223-36-2	Intentional addition / 1%	chemical products
21771	Zirconium, 1,1'-[[2-[[2-hydroxyethyl(2-hydroxypropyl)amino]ethyl]imino]bis[2-propanol] complexes	197980-53-3	Contains (regardless of intentional or impurities)	chemical products
21772	5-(2-Methoxy-4-nitrophenyl)oxazole	198821-78-2	Contains (regardless of intentional or impurities)	chemical products
21773	Nickel (trace substituent in the aluminosilicate matrix)	198831-12-8	Contains (regardless of intentional or impurities)	chemical products
21774	7-Methoxy-6-(3-morpholin-4-yl)propoxy-3H-quinazolin-4-one	199271-61-2	Contains (regardless of intentional or impurities)	chemical products
21775	Bis(neopentyl glycolato)boron	201733-56-4	Intentional addition / 1%	chemical products
21776	4-(Diphenylamino)phenylboronic acid	201802-67-7	Intentional addition / 1%	chemical products
21777	Ammonium gold sulfite	202581-61-1	Intentional addition	chemical products
21778	4-(2-Naphthyl)-1,3-thiazole-2-amine hydrobromide	202684-52-6	Contains (regardless of intentional or impurities)	chemical products
21779	alpha-Hydro-omega-[[[1,1-dimethylethyl]dioxycarbonyloxy]poly[oxy(methyl-1,2-ethanediy)] ether with 2,2-bis(hydroxymethyl)-1,3-propanediol (4:1)	203574-04-3	Contains (regardless of intentional or impurities)	chemical products
21780	Boric acid, B B'-(9,9-dihexyl-9H-fluorene-2,7-diyl)bis-	203927-98-4	Intentional addition / 1%	chemical products
21781	3-Acetylphenylboronic acid	204841-19-0	Intentional addition / 1%	chemical products
21782	C.I. Solvent Violet 49	205057-15-4	Contains (regardless of intentional or impurities)	chemical products
21783	(+)-1,2-Bis[(2S,5S)-dimethylphospholano]benzene(cyclooctadiene)rhodium(I) tetrafluoroborate	205064-10-4	Contains (regardless of intentional or impurities)	chemical products
21784	[[1R]-3-Methyl-1-[(2S)-3-phenyl-2-(pyrazin-2-ylcarbonyl)amino]propanoyl]amino]butyl]boronic acid, pinanediol ester	205393-22-2	Intentional addition / 1%	chemical products
21785	±-1,1'-(Ethylene)bis[1,2,3,3a,7a-eta-1H-indenyl]diphenoxy zirconium(IV)	205592-53-6	Intentional addition / 1,000ppm	chemical products
21786	8-Methylnonanoic acid 4-hydroxy-3-methoxybenzyl ester	205687-03-2	Contains (regardless of intentional or impurities)	chemical products
21787	2,6-Diisopropylphenylimidoneophylidene[S-(-)-biphenyl]molybdenum(VI)	205815-80-1	Intentional addition / 1%	chemical products
21788	5-Acetyl-2-thiopheneboronic acid	206551-43-1	Intentional addition / 1%	chemical products
21789	3-Aminophenylboronic acid monohydrate	206658-89-1	Intentional addition / 1%	chemical products
21790	Siloxane 42FA	206886-57-9	Intentional addition / 100ppm	chemical products
21791	Cobalt(II) hexafluoroacetate hydrate	206986-92-7	Intentional addition / 1%	chemical products
21792	Bis(salicylaldehyde)cobalt(II) dihydrate	207124-67-2	Intentional addition / 1%	chemical products
21793	(Ethylenebis(nitro)methylidene)-2,2'-diphenolato]cobalt(II) hydrate	207124-68-3	Intentional addition / 1%	chemical products
21794	N,N-Bis(salicylidene)-1,2-phenylenediaminocobalt(II) monohydrate	207124-69-4	Intentional addition / 1%	chemical products
21795	Nickel(II), 2,9,16,23-tetrahydro-29H,31H-phthalocyanine	207569-15-1	Contains (regardless of intentional or impurities)	chemical products
21796	Heptanoic acid, 2,3,4,4,5,5,6,6,7,7,7-dodecafluoro-2-(trifluoromethyl)-	207678-51-1	Intentional addition / 1,000ppm	chemical products
21797	Aluminum boron cobalt lithium nickel oxide	207803-51-8	Contains (regardless of intentional or impurities)	chemical products
21798	Boric acid, B-(4-methoxy-2-methylphenyl)-	208399-66-0	Intentional addition / 1%	chemical products
21799	Yttrium oxide sulfide (Y2O2S), terbium-doped	208778-33-0	Intentional addition / 1%	chemical products
21800	Yttrium oxide sulfide (Y2O2S), europium- and terbium-doped	209418-02-0	Intentional addition / 1%	chemical products
21801	Yttrium oxide sulfide (Y2O2S), praseodymium-doped	209418-03-1	Intentional addition / 1%	chemical products
21802	Yttrium oxide sulfide (Y2O2S), ytterbium-doped	209418-04-2	Intentional addition / 1%	chemical products
21803	Cobalt lithium manganese nickel oxide	209668-02-0	Contains (regardless of intentional or impurities)	chemical products
21804	Molybdenum(V) isopropoxide	209733-38-0	Intentional addition / 1%	chemical products
21805	(-)-1,2-Bis[(2R,5R)-dimethylphospholano]benzene(cyclooctadiene)rhodium(I) tetrafluoroborate	210057-23-1	Contains (regardless of intentional or impurities)	chemical products
21806	Clothinidin	210880-92-5	Contains (regardless of intentional or impurities)	chemical products
21807	Vanadium, lactate oxo sodium complexes	211389-36-5	Intentional addition / 1%	chemical products
21808	5,5'-B(1H-tetrazole) manganese dihydrate	211948-57-1	Intentional addition / 1%	chemical products
21809	N-(2,4-Difluorophenyl)-N-isopropylcarbamoyl chloride	212203-09-3	Intentional addition / 1%	chemical products
21810	(1R,2R)-N,N-Bis[3-oxo-2-(2,4,6-trimethylbenzoyl)butylidene]-1,2-diphenylethylenediaminocobalt(II)	212250-92-5	Intentional addition / 1%	chemical products
21811	1,1'-Diocetyl-4,4'-bipyridinium tetrafluoroborate(1-)(1:2)	212271-71-1	Intentional addition / 1%	chemical products
21812	Boric acid, B-(4-ethoxy-2,3-difluorophenyl)-	212386-71-5	Intentional addition / 1%	chemical products
21813	Chromate(3-), [4-amino-5-(hydroxy-kappa-O)-6-[[2-(hydroxy-kappa-O)-4-nitrophenyl]azo-kappa-N1]-1,7-naphthalenedisulfonato(4-)-]]2-[[5-(aminosulfonyl)-2-(hydroxy-kappa-O)phenyl]azo-kappa-N1]-3-(oxo-kappa-O)-N-phenylbutanamidato(2-)-], trisodium	212716-69-3	Contains (regardless of intentional or impurities)	chemical products
21814	Chromate(5-), bis[4-amino-5-(hydroxy-kappa-O)-6-[[2-(hydroxy-kappa-O)-4-nitrophenyl]azo-kappa-N1]-1,7-naphthalenedisulfonato(4-)-], pentasodium	212716-70-6	Contains (regardless of intentional or impurities)	chemical products
21815	Boric acid, (2,3-difluoro-4-propoxyphenyl)-	212837-49-5	Intentional addition / 1%	chemical products
21816	2-Ethoxybenzenboronic acid	213211-69-9	Intentional addition / 1%	chemical products
21817	1H-Indole-2-boronic acid, N-BOC protected	213318-44-6	Intentional addition / 1%	chemical products
21818	4-(2-Chloro-4,6-dinitrophenylazo)-5-acetylamino-2-methoxy-N(2-methoxy-2-oxoethyl)-N(2-ethoxy-2-oxoethyl)aniline	213831-09-5	Contains (regardless of intentional or impurities)	chemical products
21819	Hydroxocobalamin acetate	214142-68-4	Intentional addition / 1%	chemical products
21820	3-Cyano-4-fluorobenzenboronic acid	214210-21-6	Intentional addition / 1%	chemical products
21821	1-(2-Amino-5-chlorophenyl)-2,2-trifluoro-1,1-ethanediol, hydrochloride	214353-17-0	Contains (regardless of intentional or impurities)	chemical products
21822	(3-Cyanophenyl)boronic acid, neopentyl glycol ester	214360-45-9	Intentional addition / 1%	chemical products
21823	3-Cyanophenylboronic acid pinacol ester	214360-46-0	Intentional addition / 1%	chemical products
21824	4-Sulphamoylbenzenboronic acid, pinacol ester	214360-51-7	Intentional addition / 1%	chemical products
21825	2,6-Dimethoxypyridine-3-boronic acid pinacol ester	214360-59-5	Intentional addition / 1%	chemical products
21826	Rac-methylene-bis(3-tert-butyl-1H-inden-1-yl)zirconium dichloride	214402-07-6	Contains (regardless of intentional or impurities)	chemical products
21827	Boric acid, polymer with N-decyl-1-decanamine, oxirane and 1,2-propanediol	214710-34-0	Intentional addition / 100ppm	chemical products
21828	Boric acid, B-[2-(4-fluorophenyl)ethyl]-	214907-24-1	Intentional addition / 1%	chemical products
21829	Stannane, tris(3,4,4,5,5,6,6,7,7,7-nonafluorooxyethyl)-2-propen-1-yl-	215186-99-5	Contains (regardless of intentional or impurities)	chemical products
21830	Nickel(II) bis[9-[[6-tert-butyl-1,3-benzothiazol-2-yl]diazenyl]-2,3,6,7-tetrahydro-1H,5H-pyrido[3,2,1-i]quinoline-8-sulfonate]	215191-83-6	Contains (regardless of intentional or impurities)	chemical products
21831	Phenyl-d5-boronic acid	215527-70-1	Intentional addition / 1%	chemical products
21832	Boric acid, B-(3-chloro-1-propen-1-yl)-	215951-86-3	Intentional addition / 1%	chemical products
21833	3-Isopropylbenzenboronic acid	216019-28-2	Intentional addition / 1%	chemical products
21834	3-Isopropoxybenzenboronic acid	216485-86-8	Intentional addition / 1%	chemical products
21835	Acetamide, 2-bromo-N-(6-methyl-2,4-bis(methylthio)-3-pyridinyl)-	217096-06-5	Intentional addition / 1%	chemical products
21836	Stannane, tris(4,4,5,5,6,6,7,7,7-nonafluorooxyethyl)-2-propen-1-yl-	217805-03-3	Contains (regardless of intentional or impurities)	chemical products
21837	4,4-Dimethylcyclohex-2-enone-2-boronic acid pinacol ester	219489-09-5	Intentional addition / 1%	chemical products
21838	Chromate(5-), bis[5-[[1-(acetyl-kappa-O)-2-oxo-2-(phenylamino)ethyl]azo-kappa-N1]-4-(hydroxy-kappa-O)-1,3-benzenedisulfonato(4-)-], potassium tetrasodium	219539-04-5	Contains (regardless of intentional or impurities)	chemical products
21839	2-Chloro-4-methoxyphenylboronic acid	219735-99-6	Intentional addition / 1%	chemical products
21840	4-Methoxynaphthalen-1-ylboronic acid	219834-95-4	Intentional addition / 1%	chemical products
21841	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, nickel salt (1:?)	219948-04-6	Contains (regardless of intentional or impurities)	chemical products
21842	(2,2-Bis[3,5-dimethylphenyl]phosphano-kappa-P)-1,1'-binaphthyl[1,1'-bis(4-methoxyphenyl)-3-methylbutane-1,2-diamine-kappa,2a,N]dichlorozirconium(II)	220114-32-9	Contains (regardless of intentional or impurities)	chemical products
21843	1H-Indole-4-boronic acid	220465-43-0	Intentional addition / 1%	chemical products
21844	Hafnium, tetrachloro[1,2-di(methoxy-kappa-O)ethane]-, (OC-6-22)	220911-52-4	Intentional addition / 1%	chemical products
21845	2,5-Dimethoxy-3-pyridineboronic acid	221006-70-8	Intentional addition / 1%	chemical products
21846	3-Isopropylphenylboronic acid	221037-98-5	Intentional addition / 1%	chemical products
21847	2-Chloro-3-isobutoxy-1-cyclobutane	221235-01-4	Intentional addition / 1%	chemical products
21848	2,4,4-Trichloro-3-isobutoxy-2-cyclobutene-1-one	221235-15-0	Intentional addition / 1%	chemical products
21849	3-(tert-Butylamino)sulphonylbenzenboronic acid	221290-14-8	Intentional addition / 1%	chemical products
21850	Silica gel, reaction products with chromate ester, and metal alkoxide	221455-10-3	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
21851	2-Bromopyridine-5-boronic acid	223463-14-7	Intentional addition / 1%	chemical products
21852	4-[(Methylamino)sulfonyl]benzene boronic acid	226396-31-2	Intentional addition / 1%	chemical products
21853	2,3,4-Trifluorophenylboronic acid	226396-32-3	Intentional addition / 1%	chemical products
21854	Benzene, 2,4-dinitro-1-(tetradecyloxy)-	226921-61-5	Intentional addition / 1%	chemical products
21855	Zirconium aqua 3,5-bis(1,1-dimethylethyl)-2-hydroxybenzoate hydroxy oxo complexes	226996-19-6	Contains (regardless of intentional or impurities)	chemical products
21856	2,3-Dihydrobenzo[b]furan-5-boronic acid	227305-69-3	Intentional addition / 1%	chemical products
21857	Cobalt lithium manganese nickel oxide	227623-80-5	Contains (regardless of intentional or impurities)	chemical products
21858	[4-Hydroxyphenyl]dimethylsulfonium tetrakis(2,3,4,5,6-pentafluorophenyl)borate(1-)(1:1)	228731-13-3	Intentional addition / 1%	chemical products
21859	Di-tert-butyl chloromethyl phosphate	228625-50-7	Contains (regardless of intentional or impurities)	chemical products
21860	Bis(hexyleneglycolato)diboron	230299-21-5	Intentional addition / 1%	chemical products
21861	Bis(2,4-dimethylpentane-2,4-glycolato)diboron	230299-46-4	Intentional addition / 1%	chemical products
21862	1,2-Benzindole, 4-(1,1-dimethyl)-, polymer with (chloromethyl)oxirane	234114-82-0	Intentional addition / 1%	chemical products
21863	Magnesium, EDTA cobalt copper iron manganese zinc complexes	234446-82-3	Contains (regardless of intentional or impurities)	chemical products
21864	Aluminum zirconium chlorides dioxide, Al4ZrCl4(OH)12, reaction products with propylene glycol	235433-35-9	Contains (regardless of intentional or impurities)	chemical products
21865	9,9-Spiro[9H-fluorene]-2-boronic acid	236389-21-2	Intentional addition / 1%	chemical products
21866	Tris(N-tert-butyl-3,5-dimethylaminilino)molybdenum(III)	236740-70-8	Intentional addition / 1%	chemical products
21867	Boronic acid, B-(4-mercaptophenyl)-	237429-33-3	Intentional addition / 1%	chemical products
21868	Reaction product of sodium hydrogen chlorophthalate, phthalic anhydride, cobalt chloride and urea	239097-11-1	Intentional addition / 1%	chemical products
21869	1H-Imidazolium, 1-methyl-3-octyl-, tetrafluoroborate(1-)(1:1)	244193-52-0	Intentional addition / 1%	chemical products
21870	2-Bromophenylboronic acid	244205-40-1	Intentional addition / 1%	chemical products
21871	Borate(1-), bis[ethanedioato(2--)]kappa.O1,kappa.O2]-, lithium, (T-4)-	244761-29-3	Intentional addition / 1%	chemical products
21872	Potassium sodium 2-[[[3-[4-fluoro-6-[[2-[4-fluoro-6-[[4-[[4,6,8-trisulfo-2-naphthylazo]phenyl]amino]-1,3,5-triazin-2-yl]amino]-1-methylethyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa.O)-5-sulfo]phenyl]azo-kappa.N2]phenylmethyl]azo-kappa.N1]-4-sulfo]benzoate cuprate	245678-20-0	Intentional addition / 1,000ppm	chemical products
21873	Mepiquat pentaborate	245735-90-4	Intentional addition / 1%	chemical products
21874	2,5-Dimethyl-4-methoxybenzeneboronic acid	246023-54-1	Intentional addition / 1%	chemical products
21875	2,4,5-Trifluorophenylboronic acid	247564-72-3	Intentional addition / 1%	chemical products
21876	3-Fluoro-4-formylphenylboronic acid	248270-25-9	Intentional addition / 1%	chemical products
21877	Furan-3-boronic acid, pinacol ester	248924-59-6	Intentional addition / 1%	chemical products
21878	[3-(2-Ethylhexyloxy)propylamine]triphenylboron	250578-38-2	Intentional addition / 1%	chemical products
21879	[1-[[3,5-Dimethyl-1H-pyrrol-2-yl](3,5-dimethyl-2H-pyrrol-2-ylidene)methyl]-4-iodobenzene](difluoroborate)	250734-47-5	Intentional addition / 1%	chemical products
21880	Copper(2+), [mu-[[2-hydroxy-N,N,N'-tetramethyl-N,N'-bis[3-[[[29H,31H-phthalocyanin-C-yl]-kappa.N29,kappa.N30,kappa.N31,kappa.N32]sulfonylamino]propyl]-1,3-propanediaminiumato(4-)]di-, pentakis[[3-(dimethylamino)propylamino]sulfonyl] derivative, salt with 2-hydroxypropanoic acid (1:2), pentakis(2-hydroxypropanoate) (salt)	251654-72-5	Intentional addition / 1,000ppm	chemical products
21881	Butene homopolymer, phosphosulfurised, molybdenum salt	253141-87-6	Intentional addition / 1%	chemical products
21882	Molybdenum, bis(2-ethylhexyl)carbamodithioato-kappa.S,kappa.S'][(d)tricyclcarbamodithioato-kappa.S,kappa.S']dioxodi-mu-thioxodi-, branched	253873-83-5	Intentional addition / 1%	chemical products
21883	Molybdenum, bis(d)tricyclcarbamodithioato-kappa.S,kappa.S']dioxodi-mu-thioxodi-, branched	253873-84-6	Intentional addition / 1%	chemical products
21884	3-Iodoacetidine-1-carboxylic acid tert-butyl ester	254454-54-1	Contains (regardless of intentional or impurities)	chemical products
21885	Zirconium N-(2-hydroxyethyl)-N,N'-tris(2-hydroxypropyl)ethylenediamine 1-propanol complexes	254889-70-8	Contains (regardless of intentional or impurities)	chemical products
21886	Boronic acid, B'B'-(9,9-dioctyl-9H-fluorene-2,7-diy)bis-	258865-48-4	Intentional addition / 1%	chemical products
21887	(1S,2S)-N,N'-Bis(2-acetyl-3-oxo-2-butenylidene)-1,2-dimethylthylenediaminato cobalt(II)	259259-80-8	Intentional addition / 1%	chemical products
21888	[2-[[[3-[4-Chloro-6-[[3,6,8-trisulfo-1-naphthalenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-O)-5-sulfo]phenyl]azo-N2]phenylmethyl]azo-N1]-4-sulfo]benzoate(7-O)-cuprate(5-), pentasodium	259748-83-9	Intentional addition / 1,000ppm	chemical products
21889	[9,9-Bis(2-ethylhexyl)-9H-fluorene-2,7-diy]bisboronic acid	264615-47-6	Intentional addition / 1%	chemical products
21890	[N-1]-[2-(2-Pyridyl)carbamodithioato]phenylthylidene]glycinato]nickel	264921-97-3	Contains (regardless of intentional or impurities)	chemical products
21891	Zirconium, IN-N-bis[2-(hydroxy-kappa.O)ethyl]glycinato(3--)]kappa.N,kappa.O]hydroxy-	265646-48-8	Contains (regardless of intentional or impurities)	chemical products
21892	Phosphoric acid, silver(1+) sodium zirconium(4+) salt	265647-11-8	Contains (regardless of intentional or impurities)	chemical products
21893	3-Carboxyphenylboronic acid pinacol ester	269409-73-6	Intentional addition / 1%	chemical products
21894	3-Ethoxycarbonylbenzeneboronic acid, pinacol ester	269410-00-6	Intentional addition / 1%	chemical products
21895	4-Pyrazolboronic acid pinacol ester	269410-08-4	Intentional addition / 1%	chemical products
21896	4-Hydroxy-3-methoxyphenylboronic acid pinacol ester	269410-22-2	Intentional addition / 1%	chemical products
21897	Manganese catalyst	269729-89-9	Contains (regardless of intentional or impurities)	chemical products
21898	Copper, bis[5-dodecyl-2-(hydroxy-kappa.O)benzaldehyde oximate-kappa.N]-, (SP-4-1)-	273404-95-8	Intentional addition / 1,000ppm	chemical products
21899	Propane, 3-bromo-1,1,1,2,3-pentafluoro-	273927-78-9	Intentional addition / 1,000ppm	chemical products
21900	Propane, 1-bromo-1,1,2,3,3-pentafluoro-	273927-79-0	Intentional addition / 1,000ppm	chemical products
21901	3-Chloro-4-ethoxybenzeneboronic acid	279261-81-3	Intentional addition / 1%	chemical products
21902	4-(Methoxymethyl)phenylboronic acid	279262-11-2	Intentional addition / 1%	chemical products
21903	1-Tridecanamine, N-tridecyl-, branched compounds with molybdenum hydroxide oxide (1:1)	280130-32-7	Intentional addition / 1%	chemical products
21904	1,2,4-Benzenetriamine, N1,N1-di-2-propen-1-yl-	280755-47-7	Intentional addition / 1%	chemical products
21905	1,2,3,6-Tetrahydropyridine-4-boronic acid, pinacol ester, N-BOC protected	286961-14-6	Intentional addition / 1%	chemical products
21906	3,6-Dihydro-2H-pyran-4-boronic acid pinacol ester	287944-16-5	Intentional addition / 1%	chemical products
21907	Benzonitrile, 2-(2,2-dimethylprooxy)-5-nitro-	288251-70-7	Intentional addition / 1%	chemical products
21908	Cuprate(4-), [2-(amino-kappa.N)ethano][7-[[3-(hydroxy-kappa.O)-4-[[1-(hydroxy-kappa.O)-3-sulfo-7-[[2-sulfoethyl]amino]-2-naphthalenyl]azo-kappa.N1]phenyl]azo]-1,3-naphthalenedisulfonato(6-)]-, tetrasodium	289632-60-6	Intentional addition / 1,000ppm	chemical products
21909	1H-Indole-1-carboxylic acid, 2-borono-5-methoxy-, 1-(1,1-dimethylethyl) ester	290331-71-4	Intentional addition / 1%	chemical products
21910	Bis[2-(hydroxy-kappa.O)-4-(methythio)butanoato-kappa.O]copper	292140-30-8	Intentional addition / 1,000ppm	chemical products
21911	Methanesulfonic acid, 1-benzylazetidini-3-yl hydrochloride	292163-60-1	Contains (regardless of intentional or impurities)	chemical products
21912	Cobalt lithium manganese nickel oxide	296800-21-0	Contains (regardless of intentional or impurities)	chemical products
21913	3-Chloro-1,1-difluoroacetone	298205-16-0	Intentional addition / 1%	chemical products
21914	Calcium, EDTA iron magnesium manganese sodium zinc complexes	301850-33-9	Contains (regardless of intentional or impurities)	chemical products
21915	4-(Hydroxymethyl)benzeneboronic acid pinacol ester	302348-51-2	Intentional addition / 1%	chemical products
21916	Cadmium zinc telluride	303114-50-3	Contains (regardless of intentional or impurities)	chemical products
21917	Nickel(II), hexafluoroacetate hydrate	304695-77-0	Contains (regardless of intentional or impurities)	chemical products
21918	3-Cyano-5-fluorobenzeneboronic acid	304858-67-1	Intentional addition / 1%	chemical products
21919	Ferrite substances, magnetoplumbite-spinel type, magnesium-manganese-strontium	304905-29-1	Contains (regardless of intentional or impurities)	chemical products
21920	3-(Methanesulfonylamino)phenylboronic acid pinacol ester	305448-92-4	Intentional addition / 1%	chemical products
21921	Boronic acid, B-(5-cyano-2-thienyl)-	305832-67-1	Intentional addition / 1%	chemical products
21922	Dihydroxy(5-phenyl-2-thienyl)borane	306934-95-2	Contains (regardless of intentional or impurities)	chemical products
21923	2-Propenoic acid, 2-methyl-, dodecyl ester, polymers with 2-[methyl(perfluoro-C4-8-alkyl)sulfonyl]amino]ethyl acrylate and vinylidene chloride	306975-62-2	Contains (regardless of intentional or impurities)	chemical products
21924	1-Ethyl-2,3-dimethylimidazolium tetrafluoroborate	307492-75-7	Intentional addition / 1%	chemical products
21925	Cadmium, bis(2,4-pentanedionato-kappa.O,kappa.O)-, monohydrate, (T-4)-	307531-70-0	Contains (regardless of intentional or impurities)	chemical products
21926	Silver borosilicate	308062-97-7	Intentional addition / 1%	chemical products
21927	Glass, oxide, silver phosphate	308069-39-8	Intentional addition / 1,000ppm	chemical products
21928	Quaternary ammonium iodides	308074-50-2	Intentional addition / 1,000ppm	chemical products
21929	Boronic acid, B-(2-acetylphenyl)-	308103-40-4	Intentional addition / 1%	chemical products
21930	[4R,5R]-4,5-Difluoro-1,3-dioxolan-2-one	311810-76-1	Contains (regardless of intentional or impurities)	chemical products
21931	Bis(1-1-cyclohexyl-1,2-dihydroxy-kappa.O)diazenumato(2-)-copper	312600-89-8	Intentional addition / 100ppm	chemical products
21932	Nickel(II) bromide 2-methoxyethyl ether complex	312696-09-6	Contains (regardless of intentional or impurities)	chemical products
21933	Tris(Butylcyclopentadienyl)yttrium	312799-77-8	Intentional addition / 1%	chemical products
21934	Nickel bromide (NB#2), monohydrate	313223-18-6	Contains (regardless of intentional or impurities)	chemical products
21935	3-Chloro-2-methylbenzeneboronic acid	313545-20-9	Intentional addition / 1%	chemical products
21936	4-Chloro-2-(trifluoromethyl)phenylboronic acid	313545-41-4	Intentional addition / 1%	chemical products
21937	2-Chloro-4-fluorobenzeneboronic acid	313545-72-1	Intentional addition / 1%	chemical products
21938	Boronic acid, B-[4-methoxy-2-(trifluoromethyl)phenyl]-	313546-16-6	Intentional addition / 1%	chemical products
21939	Boronic acid, 4-(4-butylcyclohexyl)phenyl]-	315220-11-2	Intentional addition / 1%	chemical products
21940	2-Propenoic acid 2-methyl-, methyl ester, telomer with 1-dodecanethiol, 2-ethylhexyl 2-propenoate, 3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10-heptaecafluorodecyl 2-propenoate and alpha-(2-methyl-1-oxo-2-propenyl)-omega-hydroxyopoly[oxy(methyl-1,2-ethanediyl)]	321318-71-2	Intentional addition / 100ppm	chemical products
21941	3-(Dimethylamino)phenylboronic acid pinacol ester	325142-87-8	Intentional addition / 1%	chemical products
21942	Chromate(3-), bis[3-[[6-amino-1,4-dihydro-2-[[[4-[[2-(hydroxy-1-naphthalenyl)azo]phenyl]sulfonyl]amino]-4-(oxo-kappa.O)-5-pyrimidinyl]azo-kappa.N1]-4-(hydroxy-kappa.O)-5-nitrobenzenesulfonato(3-)]-, sodium triethanolamine salts	327177-98-0	Contains (regardless of intentional or impurities)	chemical products
21943	3-(3-(Trifluoromethyl)phenoxy)methyl]phenylboronic acid	328956-60-1	Intentional addition / 1%	chemical products
21944	3-Chloro-5-fluorophenylboronic acid	328956-61-2	Intentional addition / 1%	chemical products
21945	Calcium-magnesium-silicate thermal ceramic wool	329211-92-9	Intentional addition / 1,000ppm	chemical products
21946	3-Pyridineboronic acid pinacol ester	329214-79-1	Intentional addition / 1%	chemical products
21947	4-Aminobenzeneboronic acid, pinacol ester, N-BOC protected	330793-01-6	Intentional addition / 1%	chemical products
21948	Silver perchlorate hydrate	331717-44-3	Intentional addition / 1,000ppm	chemical products
21949	Boron, trifluoro(tetrahydrofuran)-, (T-4)-, polymer with 3-methyl-3-[[2,2,2-trifluoroethoxy)methyl]oxetane, ether with 2,2-dimethyl-1,3-propanediol (2:1)	332079-07-9	Intentional addition / 1%	chemical products
21950	4-(Chlorocarbonyl)phenylboronic anhydride	332154-57-1	Intentional addition / 1%	chemical products
21951	9,9-Dimethylfluorene-2-boronic acid	333432-28-3	Intentional addition / 1%	chemical products
21952	Indenylhafnium trichloride	336102-54-6	Intentional addition / 1%	chemical products
21953	Barium thiocyanate hydrate	336879-43-7	Contains (regardless of intentional or impurities)	chemical products
21954	1H-Indazole-5-boronic acid	338454-14-1	Intentional addition / 1%	chemical products
21955	Lithium tetra(2-methyl-8-hydroxyquinolato)boron	338949-42-1	Intentional addition / 1%	chemical products
21956	4-Isobutylbenzenesulfonyl chloride	339370-45-5	Intentional addition / 1%	chemical products
21957	Nickelate(2-), tetrakis(cyano-kappa.C)-, dipotassium, hydrate, (SP-4-1)-	339527-86-5	Contains (regardless of intentional or impurities)	chemical products
21958	Pyrazine-2,5-dicarboxylate-polyiodine	343246-97-9	Contains (regardless of intentional or impurities)	chemical products
21959	Nickel ionophore I	343630-64-8	Contains (regardless of intentional or impurities)	chemical products
21960	1,1,3-Trimethyl-2-methylidene-2,3-dihydro-1H-benzo[e]indole	344928-74-1	Contains (regardless of intentional or impurities)	chemical products
21961	Boron, tributyl(3-methoxy-1-propanamine-kappa.N)-, (T-4)-	345269-15-0	Intentional addition / 1%	chemical products
21962	Cobalt lithium manganese nickel oxide	346417-97-8	Intentional addition / 1,000ppm	chemical products
21963	Chromate(4-), [6-amino-3-[[5-(aminosulfonyl)-2-(hydroxy-kappa.O)phenyl]azo-kappa.N1]-4-(hydroxy-kappa.O)-2-naphthalenesulfonato(3-)]][6-amino-4-(hydroxy-kappa.O)-3-[[2-(hydroxy-kappa.O)-5-nitro-3-sulfo]phenyl]azo-kappa.N1]-2-naphthalenesulfonato(3-)]-, tetrasodium	346693-15-0	Contains (regardless of intentional or impurities)	chemical products
21964	Chromate(3-), bis[6-amino-3-[[5-(aminosulfonyl)-2-(hydroxy-kappa.O)phenyl]azo-kappa.N1]-4-(hydroxy-kappa.O)-2-naphthalenesulfonato(3-)]-, trisodium	346693-16-1	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
21965	Chromate(4-), [6-amino-3-[[5-(aminosulfonyl)-2-(hydroxy-kappa O)phenyl]azo-kappa N1]-4-(hydroxy-kappa O)-2-naphthalenesulfonato(3-)]-6-amino-4-(hydroxy-kappa O)-3-[[2-(hydroxy-kappa O)-5-nitro-3-sulphophenyl]azo-kappa N1]-2-naphthalenesulfonato(4-)]-, potassium sodium	346709-18-0	Contains (regardless of intentional or impurities)	chemical products
21966	Chromate(5-), bis[6-amino-4-(hydroxy-kappa O)-3-[[2-(hydroxy-kappa O)-5-nitro-3-sulphophenyl]azo-kappa N1]-2-naphthalenesulfonato(4-)]-, potassium sodium	346709-19-1	Contains (regardless of intentional or impurities)	chemical products
21967	Chromate(3-), bis[6-amino-3-[[5-(aminosulfonyl)-2-(hydroxy-kappa O)phenyl]azo-kappa N1]-4-(hydroxy-kappa O)-2-naphthalenesulfonato(3-)]-, potassium sodium	346709-20-4	Contains (regardless of intentional or impurities)	chemical products
21968	2-(Methylthio)pyrimidine-5-boronic acid	348098-29-3	Intentional addition / 1%	chemical products
21969	6-Fluoro-3-pyridylboronic acid	351019-18-6	Intentional addition / 1%	chemical products
21970	3-Aminocarbonylphenylboronic acid	351422-73-6	Intentional addition / 1%	chemical products
21971	1-(tert-Butyldimethylsilyl)-1H-indole-4-boronic acid	351467-64-2	Intentional addition / 1%	chemical products
21972	Boronic acid, B-(2-fluoro-3-methoxyphenyl)-	352303-67-4	Intentional addition / 1%	chemical products
21973	Boronic acid, B-[(1E)-2-[4-(trifluoromethyl)phenyl]ethenyl]-	352525-91-8	Intentional addition / 1%	chemical products
21974	(3-Aminomethyl)benzeneboronic acid hydrochloride	352525-94-1	Intentional addition / 1%	chemical products
21975	2-Ethoxy-6-naphthaleneboronic acid	352525-98-5	Intentional addition / 1%	chemical products
21976	Boronic acid, B-[(1E)-2-[1,1'-biphenyl]-4-ylethenyl]-	352530-23-5	Intentional addition / 1%	chemical products
21977	4-(Ethylsulphonyl)benzeneboronic acid	352530-24-6	Intentional addition / 1%	chemical products
21978	Boronic acid, B-(2,4,5-trimethylphenyl)-	352534-80-6	Intentional addition / 1%	chemical products
21979	3-Bromo-2-ethoxy-5-fluorophenylboronic acid	352534-82-8	Intentional addition / 1%	chemical products
21980	3-Bromo-2-fluoro-2-isopropoxyphenylboronic acid	352534-84-0	Intentional addition / 1%	chemical products
21981	3-Bromo-2-butoxy-5-fluorophenylboronic acid	352534-85-1	Intentional addition / 1%	chemical products
21982	N-Methylethanamine, hafnium(4+) salt	352535-01-4	Intentional addition / 1%	chemical products
21983	2-Fluoro-5-(trifluoromethyl)phenylboronic acid	352535-96-7	Intentional addition / 1%	chemical products
21984	Cuprate(5-), [4-[2-[7-[2-[4-[2-(6,8-disulfo-2-naphthalenyl)diazenyl]-2-hydroxy-kappa O)phenyl]diazenyl-kappa N1]-8-(hydroxy-kappa O)-6-sulfo-2-naphthalenyl]diazenyl]-4,5-dihydro-5-oxo-1-(4-sulphophenyl)-1H-pyrazole-3-carboxylato(7-)]-, sodium (1:5)	354994-06-2	Intentional addition / 1,000ppm	chemical products
21985	4-Methoxypyridine-3-boronic acid	355004-67-0	Intentional addition / 1%	chemical products
21986	Ethane, bromodifluoro-	357188-74-0	Intentional addition	chemical products
21987	3,6-Bis(4-chlorophenyl)-1,4-dioxo-1,2,4,5-tetrahydropryrolo[3,4-c]pyrrole-2,5-disulfonic acid	358365-75-0	Contains (regardless of intentional or impurities)	chemical products
21988	Barium calcium manganese stromium oxide	359427-90-0	Contains (regardless of intentional or impurities)	chemical products
21989	(1R,2R)-N,N'-Bis(2-acetyl-3-oxo-2-butenylidene)-1,2-dimesitylthylene-diaminocobalt(II)	361346-80-7	Intentional addition / 1%	chemical products
21990	2,6-Dimethyl-4-methoxybenzeneboronic acid	361543-99-9	Intentional addition / 1%	chemical products
21991	Pyridinium, 4-borono-1-methyl-, iodide (1:1)	362045-65-6	Intentional addition / 1%	chemical products
21992	Propane, 1,3-dibromo-1,1,2,2-tetrafluoro-	362631-55-8	Intentional addition / 1,000ppm	chemical products
21993	Propane, 1,1-dibromo-2,2,3,3-tetrafluoro-	362631-56-9	Intentional addition / 1,000ppm	chemical products
21994	Propane, 1,1,3-tribromo-2,2-difluoro-	362631-77-4	Intentional addition / 1,000ppm	chemical products
21995	Boronic acid, B-[2,6-bis(1-methylthio)phenyl]-	363166-79-4	Intentional addition / 1%	chemical products
21996	4-(4-Morpholinomethyl)phenylboronic acid pinacol ester	364794-79-6	Intentional addition / 1%	chemical products
21997	Cuprate(2-), aqua[3-[2-[4,5-dihydro-3-methyl-5-(oxo-kappa O)-1-(4-sulphophenyl)-1H-pyrazol-4-yl]diazenyl-kappa N1]-4-(hydroxy-kappa O)benzenesulfonato(4-)]-, potassium sodium	366803-74-9	Intentional addition / 1,000ppm	chemical products
21998	Cuprate(3-), [3-[5-(hydroxy-kappa O)-4-[[1-(hydroxy-kappa O)-6-(phenylamino)-3-sulfo-2-naphthalenyl]azo-kappa N1]-2-methylphenyl]azo]-1,5-naphthalenedisulfonato(5-)]-, sodium, compounds with triethanolamine	371159-68-1	Intentional addition / 1,000ppm	chemical products
21999	Isoquinoline-5-boronic acid	371766-08-4	Intentional addition / 1%	chemical products
22000	Cuprate(3-), [2-[[[3-[[2,6-difluoro-4-pyrimidinyl]amino]-2-(hydroxy-kappa O)-5-sulphophenyl]azo-kappa N2]phenylmethyl]azo-kappa N1]-4-sulfo-benzoato(5-)-kappa O]-, potassium sodium hydrogen (5:10:4:1)	371973-48-7	Intentional addition / 1,000ppm	chemical products
22001	Cuprate(3-), [2-[[[3-[[4,6-difluoro-2-pyrimidinyl]amino]-2-(hydroxy-kappa O)-5-sulphophenyl]azo-kappa N2]phenylmethyl]azo-kappa N1]-4-sulfo-benzoato(5-)-kappa O]-, potassium sodium hydrogen (5:10:4:1)	371973-49-8	Intentional addition / 1,000ppm	chemical products
22002	4-Phenyl-1-naphthalenylboronic acid	372521-91-0	Intentional addition / 1%	chemical products
22003	5-Methylpyridine-2-boronic acid	372983-49-0	Intentional addition / 1%	chemical products
22004	6-Methylpyridine-2-boronic acid	372983-50-3	Intentional addition / 1%	chemical products
22005	Copper, [29H,31H-phthalocyaninato(2-)-kappa N29, kappa N30, kappa N31, kappa N32]-, (4-methoxyphenyl)amino (4-methylphenyl)thio derivatives	373383-89-2	Intentional addition / 1,000ppm	chemical products
22006	3-Dimethylcarbamoylbenzeneboronic acid	373384-14-6	Intentional addition / 1%	chemical products
22007	4-Fluoro-3-formylphenylboronic acid	374538-01-9	Intentional addition / 1%	chemical products
22008	2-(Methoxycarbonyl)benzeneboronic acid	374538-03-1	Intentional addition / 1%	chemical products
22009	2-[2-(1,2-Ethanedithiolyl)bis(oxyl)bisethanamine polymer with guanidine monohydrochloride	374572-91-5	Intentional addition / 1,000ppm	chemical products
22010	Barium calcium europium stromium silicate (Ba1.3Ca0.2Eu0.1Sr0.4SiO4)	374783-70-7	Intentional addition	chemical products
22011	4-Bromo-2,3-difluorobenzeneboronic acid	374790-99-5	Intentional addition / 1%	chemical products
22012	Nickel, [29H,31H-phthalocyaninato(2-)-xN29,xN30,xN31,xN32]-, aminosulphonyl sulpho derivatives, sodium salts	375380-39-5	Contains (regardless of intentional or impurities)	chemical products
22013	Chromate(1-), bis[3,5-bis(1,1-dimethylethyl)-2-(hydroxy-kappa O)benzoato(2-)-kappa O]-, (T-4)-, hydrogen, reaction products with butyl acrylate-p-divinylbenzene-maleic anhydride-mono-butyl maleate-styrene polymer	375844-55-6	Contains (regardless of intentional or impurities)	chemical products
22014	Chromate(1-), bis[3,5-bis(1,1-dimethylethyl)-2-(hydroxy-kappa O)benzoato(2-)-kappa O]-, (T-4)-, hydrogen, reaction products with 3-(dodecenyloxy)hydro-2,5-furandione-polyethylene glycol ether with bisphenol A (2:1)-polypropylene glycol ether with bisphenol A (2:1)-terephthalic acid-trimellitic anhydride polymer	375844-57-8	Contains (regardless of intentional or impurities)	chemical products
22015	Chromate(1-), bis[3,5-bis(1,1-dimethylethyl)-2-(hydroxy-kappa O)benzoato(2-)-kappa O]-, (T-4)-, hydrogen, reaction products with butyl acrylate-p-divinylbenzene-maleic anhydride-mono-butyl maleate-styrene polymer	375844-58-9	Contains (regardless of intentional or impurities)	chemical products
22016	Chromate(1-), bis[3,5-bis(1,1-dimethylethyl)-2-(hydroxy-kappa O)benzoato(2-)-kappa O]-, (T-4)-, hydrogen, reaction products with acrylic acid-butyl acrylate-p-divinylbenzene-mono-butyl maleate-styrene polymer	375844-65-8	Contains (regardless of intentional or impurities)	chemical products
22017	Pyrazole-3-boronic acid hydrochloride	376584-63-3	Intentional addition / 1%	chemical products
22018	Barium-131m	378253-37-3	Intentional addition	chemical products
22019	Barium-133m	378253-38-4	Intentional addition	chemical products
22020	Barium-135m	378253-39-5	Intentional addition	chemical products
22021	Cadmium-113m	378253-44-2	Contains (regardless of intentional or impurities)	chemical products
22022	Cadmium-115m	378253-45-3	Contains (regardless of intentional or impurities)	chemical products
22023	Cadmium-117m	378253-46-4	Contains (regardless of intentional or impurities)	chemical products
22024	Cobalt-58m	378253-51-1	Intentional addition / 1%	chemical products
22025	Cobalt-60m	378253-52-2	Intentional addition / 1%	chemical products
22026	Cobalt-62m	378253-53-3	Intentional addition / 1%	chemical products
22027	Hafnium-177m	378750-96-8	Intentional addition / 1%	chemical products
22028	Hafnium-178m	378750-90-4	Intentional addition / 1%	chemical products
22029	Hafnium-179m	378751-20-3	Intentional addition / 1%	chemical products
22030	Hafnium-180m	378751-48-3	Intentional addition / 1%	chemical products
22031	Hafnium-182m	378751-50-9	Intentional addition / 1%	chemical products
22032	Molybdenum-93m	378782-19-5	Intentional addition / 1%	chemical products
22033	Trimethylindium tetraglyme	378789-47-0	Intentional addition / 1%	chemical products
22034	2-Formylphenylboronic acid pinacol ester	380151-85-9	Intentional addition / 1%	chemical products
22035	4-(Isopropylthio)benzeneboronic acid	380427-38-3	Intentional addition / 1%	chemical products
22036	4-Aminobenzeneboronic acid, N-BOC protected	380430-49-9	Intentional addition / 1%	chemical products
22037	2-(Ethoxycarbonyl)phenylboronic acid	380430-53-5	Intentional addition / 1%	chemical products
22038	3-Amino-5-(methoxycarbonyl)benzeneboronic acid hydrochloride	380430-56-8	Intentional addition / 1%	chemical products
22039	3-[(E)-3-Methoxy-3-oxoprop-1-en-1-yl]benzeneboronic acid	380430-59-1	Intentional addition / 1%	chemical products
22040	2-(Methanesulfonylamino)phenylboronic acid pinacol ester	380430-60-4	Intentional addition / 1%	chemical products
22041	3-(Aminomethyl)benzeneboronic acid, pinacol ester hydrochloride	380430-65-9	Intentional addition / 1%	chemical products
22042	2,3,6-Trimethoxybenzeneboronic acid	380430-67-1	Intentional addition / 1%	chemical products
22043	Carbamic acid, N-(3-boronophenyl)-, C-(1,1-dimethylethyl) ester	380430-68-2	Intentional addition / 1%	chemical products
22044	2-Chloropyridine-3-boronic acid	381248-04-0	Intentional addition / 1%	chemical products
22045	Boronic acid, B-(2-chloro-6-methoxyphenyl)-	385370-80-9	Intentional addition / 1%	chemical products
22046	2,3,4,5-Tetramethyl-2,4-cyclohexadienyllithium	386708-10-7	Contains (regardless of intentional or impurities)	chemical products
22047	Cuprate(3-), [4,5-dihydro-4-[[8-(hydroxy-kappa O)-7-[2-[[2-(hydroxy-kappa O)-4-[[2-(hydroxyethyl)sulfonyl]-5-methoxyphenyl]azo-kappa N1]-6-sulfo-2-naphthalenyl]azo]-5-oxo-1-(4-sulphophenyl)-1H-pyrazol-3-carboxylato(5-)]]-, disodium hydrogen	388616-20-4	Intentional addition / 1,000ppm	chemical products
22048	4-(Diethylcarbamoyl)phenylboronic acid	389621-80-1	Intentional addition / 1%	chemical products
22049	4-(Pyridinyl)-1-carbonylbenzeneboronic acid	389621-81-2	Intentional addition / 1%	chemical products
22050	Rosin compound with (T-4)-(ethanamine)trifluoroboron	391894-93-2	Intentional addition / 1%	chemical products
22051	Cuprate(3-), [2-amino-5-(hydroxy-kappa O)-6-[[2-[[2-(hydroxy-kappa O)-5-sulphophenyl]azo-kappa N1]-4,5-dimethoxyphenyl]azo-kappa N1]-1,7-naphthalenedisulfonato(5-)]-, trihydrogen	393523-87-0	Intentional addition / 1,000ppm	chemical products
22052	1-[2,6-dichloro-4-(trifluoromethyl)phenyl]-4-[[difluoromethyl]thio]-5-[[2-pyridinylmethyl]amino]-1H-pyrazole-3-carbonitrile	394730-71-3	Intentional addition	chemical products
22053	3-(Cyanomethyl)phenylboronic acid pinacol ester	396131-82-1	Intentional addition / 1%	chemical products
22054	Silver-zinc-aluminium-boronophosphate glass / Glass oxide, silver- and zinc-containing	398477-47-9	Intentional addition / 100ppm	chemical products
22055	10-(4-Biphenyl)anthracene-9-yl boronic acid	400607-47-8	Intentional addition / 1%	chemical products
22056	10-[1,1'-Biphenyl]-2-yl-9-anthracenylboronic acid	400607-48-9	Intentional addition / 1%	chemical products
22057	1-(Diethoxymethyl)cyclopropanecarbaldehyde	400709-86-6	Contains (regardless of intentional or impurities)	chemical products
22058	Cuprate(3-), [N-[2-[[4-(hydroxy-kappa O)-3-[2-[[2-(hydroxy-kappa O)-3,6-disulfo-1-naphthalenyl]diazenyl-kappa N1]phenyl]sulfonyl]ethyl]glycinate(5-)]]-, sodium (1:3)	401803-97-2	Intentional addition / 1,000ppm	chemical products
22059	Mixture of 2,3,3,3-tetrafluoro-2-(perfluoropropoxy) propionic acid -1,5-dichloro-1,1,2,3,3,4,4,5,5-nonafluoropentane-2-yl, 2,3,3,3-tetrafluoro-2-(perfluoropropoxy) propionic acid -3,5-dichloro-1,1,1,2,3,3,4,4,5,5-nonafluoropentane-2-yl, and 2,3,3,3-tetrafluoro-2-(perfluoropropoxy) propionic acid -4,5-dichloro-1,1,1,2,3,3,4,4,5,5-nonafluoropentane-2-yl,	402570-11-0	Contains (regardless of intentional or impurities)	chemical products
22060	Zirconium, (benzenesulfonato-kappa O)tris[2,2-bis[(2-propen-1-yloxy)methyl]-1-butanolato-kappa O]-, ar-C10-16-alkyl derivatives	402724-28-1	Contains (regardless of intentional or impurities)	chemical products
22061	6-Quinolineboronic acid pinacol ester	406463-06-7	Intentional addition / 1%	chemical products
22062	2-Fluoro-5-methoxybenzeneboronic acid	406482-19-7	Intentional addition / 1%	chemical products
22063	2,6-Difluoro-4-methoxybenzeneboronic acid	406482-20-0	Intentional addition / 1%	chemical products
22064	3-Iodophenylboronic acid pinacol ester	408492-28-4	Intentional addition / 1%	chemical products
22065	Boronic acid, B-cyclopropyl-	411235-57-9	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
22066	Cuprate(4-), [2-[[[3-[[4-(cyanamino)-6-[[3-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa.O)-5-sulfonyl]azo-kappa.N2]phenyl]methyl]azo-kappa.N1]-1,4-benzenedisulfonato(6-)-kappa.O1]-, sodium	417707-11-0	Intentional addition / 1,000ppm	chemical products
22067	4-[4-Amino-3-chlorophenoxy]-7-methoxyquinoline-6-carboxamide hydrate	417722-93-1	Contains (regardless of intentional or impurities)	chemical products
22068	B-[4-(9H-Carbazol-9-yl)phenyl]boronic acid	419536-33-7	Intentional addition / 1%	chemical products
22069	2-Bromomethyl-4-fluorobenzenitrile	421552-12-7	Intentional addition	chemical products
22070	(2S)-4-(Chloroacetyl)-2-methyl-2,5-dihydropyrrole-1-carboxylic allyl ester	426253-76-1	Contains (regardless of intentional or impurities)	chemical products
22071	Cobalt lithium manganese nickel oxide	427884-48-8	Contains (regardless of intentional or impurities)	chemical products
22072	Cuprate(1-), [C,C,O-tris(aminosulfonyl)-29H,31H-phthalocyanine-C-sulfonato(3-)-kappa.N29.kappa.N30.kappa.N31.kappa.N32]-, sodium	438468-58-7	Intentional addition / 1,000ppm	chemical products
22073	Barium [diethoxyaluminum], mu-[2-(2-ethoxy-kappa.O)ethoxy-kappa.O]ethanolato-kappa.O.kappa.O][2-(2-ethoxy-kappa.O)ethoxy-kappa.O]ethanolato-kappa.O]-mu-octyl-	438568-53-7	Intentional addition	chemical products
22074	4-Chlorobutyl-2-nitrobenzenesulfonate	441002-17-1	Intentional addition / 1%	chemical products
22075	Vinylboronic anhydride pyridine complex	442850-89-7	Intentional addition / 1%	chemical products
22076	Tetrachlorodiborane	443783-82-2	Intentional addition / 1%	chemical products
22077	6-Chloro-3-pyridinylboronic acid	444120-91-6	Intentional addition / 1%	chemical products
22078	6-Chloro-3-pyridineboronic acid pinacol ester	444120-94-9	Intentional addition / 1%	chemical products
22079	2-Chloro-5-fluorobenzeneboronic acid	444666-39-1	Intentional addition / 1%	chemical products
22080	Amides, coco, N,N-bis(hydroxyethyl), reaction products with coco monoglycerides and molybdenum oxide (MoO3)	445409-27-8	Intentional addition / 1,000ppm	chemical products
22081	Boronic acid, [6-(benzoylmethylamino)-5-methyl-3-pyridinyl]-	446299-81-6	Intentional addition / 1%	chemical products
22082	Boron, trifluoro(tetrahydrofuran)-, (T-4)-, polymer with 3-methyl-3-[[2,2,2-trifluoroethoxy)methyl]oxetane, ether with 2,2-dimethyl-1,3-propanediol (2:1), bis(hydrogen sulfate), diammonium salt	452080-64-7	Intentional addition / 1%	chemical products
22083	Boron, trifluoro(tetrahydrofuran)-, (T-4)-, polymer with 3-methyl-3-[[2,2,3,3,3-pentafluoropropoxy)methyl]oxetane, ether with 2,2-dimethyl-1,3-propanediol (2:1), bis(hydrogen sulfate), diammonium salt	452080-67-0	Intentional addition / 1%	chemical products
22084	5-Bromo-3-pyridylboronic acid	452972-09-7	Intentional addition / 1%	chemical products
22085	2-Chloro-3-pyridineboronic acid pinacol ester	452972-11-1	Intentional addition / 1%	chemical products
22086	5-Bromo-3-pyridineboronic acid pinacol ester	452972-13-3	Intentional addition / 1%	chemical products
22087	4-Chloropyridine-3-boronic acid, pinacol ester	452972-15-5	Intentional addition / 1%	chemical products
22088	1-Methyl-1,2,3,6-tetrahydropyridine-4-boronic acid, pinacol ester	454482-11-2	Intentional addition / 1%	chemical products
22089	2-Chloropyridine-4-boronic acid, pinacol ester	458532-84-8	Intentional addition / 1%	chemical products
22090	2-Fluoropyridine-4-boronic acid, pinacol ester	458532-86-0	Intentional addition / 1%	chemical products
22091	3-Chloro-4-pyridineboronic acid pinacol ester	458532-90-6	Intentional addition / 1%	chemical products
22092	2-Chloro-4-pyridinylboronic acid	458532-96-2	Intentional addition / 1%	chemical products
22093	2-Methyl-6-methoxy-pyridine-3-boronic acid	459856-12-3	Intentional addition / 1%	chemical products
22094	Cuprate(3-), [3-(hydroxy-kappa.O)-4-[[2-(hydroxy-kappa.O)-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo-kappa.N1]-2,7-naphthalenedisulfonato(5-)]-	472956-91-5	Intentional addition / 1,000ppm	chemical products
22095	Boronic acid, B-[4-(trifluoromethyl)phenyl]-, bis(1-methylethyl) ester	474535-27-8	Intentional addition / 1%	chemical products
22096	Canola oil reaction products with branched N1-[3-(tricycloxy)propyl]-1,3-propanediamine, carbon disulfide and molybdenum oxide	474795-79-4	Intentional addition / 1%	chemical products
22097	Cuprate(4-), [2-[[[4-fluoro-6-[methyl[[2-(2-(sulfoxy)ethyl]sulfonyl]ethyl]amino]-1,3,5-triazin-2-yl]amino]-5-(hydroxy-kappa.O)-6-[2-[2-[2-(2-(hydroxy-kappa.O)-5-sulfonyl]diacyenyl-kappa.N1]-4,5-dimethoxyphenyl]diacyenyl-kappa.N1]-1,7-naphthalenedisulfonato(6-)]-], sodium (1:4)	479541-17-8	Intentional addition / 1,000ppm	chemical products
22098	2-Ethoxy-3-formyl-5-methylphenylboronic acid	480424-54-2	Intentional addition / 1%	chemical products
22099	4-Ethoxy-3-formylphenylboronic acid	480424-63-3	Intentional addition / 1%	chemical products
22100	2-Acetoxybenzeneboronic acid, pinacol ester	480424-68-6	Intentional addition / 1%	chemical products
22101	3-Acetoxybenzeneboronic acid, pinacol ester	480424-69-9	Intentional addition / 1%	chemical products
22102	Boronic acid, B-[9-(9-didodecyl-9H-fluorene-2,7-diyl)bis-	480424-86-0	Intentional addition / 1%	chemical products
22103	3-Acetamidophenylboronic acid pinacol ester	480424-93-9	Intentional addition / 1%	chemical products
22104	4-(Succinylamino)phenylboronic acid pinacol ester	480424-98-4	Intentional addition / 1%	chemical products
22105	3-(Methoxycarbonyl)benzeneboronic acid, pinacol ester	480425-35-2	Intentional addition / 1%	chemical products
22106	Nickelate(3-), [3-[[2-(amino-kappa.N)-5-hydroxy-7-sulfo-1-naphthalenyl]azo-kappa.N1]-2-(hydroxy-kappa.O)-5-sulfonazo(5-)]-, trisodium	480445-87-2	Contains (regardless of intentional or impurities)	chemical products
22107	4-Bromo-4-biphenylboronic acid	480996-05-2	Intentional addition / 1%	chemical products
22108	4-Fluoro-3-(hydroxymethyl)benzeneboronic acid	481681-02-1	Intentional addition / 1%	chemical products
22109	4-(N,N-Dimethylsulphonamido)benzeneboronic acid	486422-59-7	Intentional addition / 1%	chemical products
22110	4-(morpholin-4-ylsulphonyl)benzeneboronic acid	486422-68-8	Intentional addition / 1%	chemical products
22111	Molybdenum(1+), tris(carbamodithioato-kappa.S.kappa.S')tris(m'-disulfur-kappa.S.kappa.S':kappa.S.kappa.S')]-U3-thiooxtri-N,N,N',N',N',N'-hexacoalkyl derivatives, salts with dicoalkyl carbamodithioates (1:1)	488128-29-6	Intentional addition / 1%	chemical products
22112	4-Nitrobenzyl (2S,4S)-4-(acetysulfanyl)-2-[[tert-butoxycarbonyl(sulfamoyl)amino]methyl]pyrrolidine-1-carboxylate	491878-06-9	Contains (regardless of intentional or impurities)	chemical products
22113	Nickel, bis[N-[6-[2-(4,5-dicyano-1-methyl-1H-imidazol-2-yl)-kappa.N3]diacyenyl-kappa.N1]-1,2,3,4-tetrahydro-1-methyl-7-quinolinyl]-1,1,1-trifluoromethanesulfonamidato-kappa.N]-	494197-74-9	Contains (regardless of intentional or impurities)	chemical products
22114	Nickel, bis[9-[[6-bromo-2-benzothiazolyl-kappa.N3]azo-kappa.N1]-2,3,6,7-tetrahydro-3-methyl-1H,5H-benzol[quinoxaline-8-sulfonato-kappa.O8]-	494197-76-1	Contains (regardless of intentional or impurities)	chemical products
22115	Cuprate(2-), [7-[[2,6-difluoro-4-pyrimidinyl]amino]-3-[[5-(ethenylsulfonyl)-2-(hydroxy-kappa.O)-3-sulfonyl]azo-kappa.N1]-4-(hydroxy-kappa.O)-2-naphthalenesulfonato(4-)]-, disodium (9Cl)	495405-74-8	Intentional addition / 1,000ppm	chemical products
22116	Cuprate(3-), [7-[[2,6-difluoro-4-pyrimidinyl]amino]-4-(hydroxy-kappa.O)-3-[[2-(hydroxy-kappa.O)-3-sulfo-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo-kappa.N1]-2-naphthalenesulfonato(5-)]-, trisodium	495405-75-9	Intentional addition / 1,000ppm	chemical products
22117	6-[4-(tert-Butoxycarbonyl)piperazin-1-yl]pyridine-3-boronic acid, pinacol ester	496786-98-2	Intentional addition / 1%	chemical products
22118	Cuprate(3-), [C-(aminosulfonyl)-29H,31H-phthalocyanine-C,C,O-trisulfonato(5-)-kappa.N29.kappa.N30.kappa.N31.kappa.N32]-, trisodium	496923-23-0	Intentional addition / 1,000ppm	chemical products
22119	5-Cyanopyridine-3-boronic acid	497147-93-0	Intentional addition / 1%	chemical products
22120	Bicyclo[2.2.1]hepta-5-ene-2-sulfonyl chloride	498563-29-4	Contains (regardless of intentional or impurities)	chemical products
22121	3-IN-Benzyl-4-[[4-nitrophenyl]azo]lanolinopropanenitrile	498786-45-7	Intentional addition	chemical products
22122	Siloxanes and silicones, dimethyl, mono[3-[[2-methyl-1-oxo-2-propenyl]oxy]propyl] group-terminated, polymers with 3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10-heptafluoro-1-decanol and 2-hydroxyethyl acrylate-blocked 2,4-TDI-trimethylpropane polymer, 2-hydroxyethyl methacrylate, isobutyl methacrylate, methyl methacrylate and polyethylene-polypropylene glycol monoacrylate, tert-butyl-2-ethylhexaneperoxoate-initiated	501098-09-5	Intentional addition / 100ppm	chemical products
22123	Propane, 2,3-dibromo-1,1,1,3-tetrafluoro-	501435-65-0	Intentional addition / 1,000ppm	chemical products
22124	Barium calcium europium strontium silicate (Ba,Ca,Eu,Sr)(2SiO4)	501680-79-1	Intentional addition	chemical products
22125	Phosphoric acid, nickel(2+) zinc salt (2:1:2), tetrahydrate	501953-51-1	Contains (regardless of intentional or impurities)	chemical products
22126	Barium, benzoate 2-(2-butoxyethoxy)ethyl phosphonate p-tert-butylbenzoate phenyl phosphonate oleate complexes	502165-56-2	Intentional addition	chemical products
22127	2H-1,4-Benzoxazine-2-methanol, 3,4-dihydro-4-methyl-, 4-methylbenzenesulfonate ester, (2S)-	502434-59-5	Contains (regardless of intentional or impurities)	chemical products
22128	Nickel ionophore III	502927-11-9	Contains (regardless of intentional or impurities)	chemical products
22129	2-Fluoro-4-(trifluoromethyl)benzeneboronic acid	503309-11-3	Intentional addition / 1%	chemical products
22130	Dimethyl 2,2-[[5-acetamido-2-[[2-cyano-4-nitrophenyl]azo]phenyl]imino]diacetate	504435-23-8	Intentional addition	chemical products
22131	3-Fluoro-4-(methoxycarbonyl)benzeneboronic acid	505083-04-5	Intentional addition / 1%	chemical products
22132	2,2',6'-Tribromobiphenyl	507241-82-9	Intentional addition / 1,000ppm	chemical products
22133	Sodium 3-(N-[8-[[2-cyano-4-nitrophenyl]azo]-5-hydroxy-6-propanamide-1-naphthyl]sulfonyl)benzenesulfonate	508182-80-7	Intentional addition	chemical products
22134	Cobalt, 3-[[5-(aminosulfonyl)-2-hydroxyphenyl]azo]-4-hydroxy-7-(phenylamino)-2-naphthalenesulfonate 4-hydroxy-3-[[2-(hydroxy-5-sulfonylphenyl]-7-(phenylamino)-2-naphthalenesulfonate sodium complexes	508202-43-5	Contains (regardless of intentional or impurities)	chemical products
22135	2,3,5,6-Tetrafluorobenzeneboronic acid	511295-01-5	Intentional addition / 1%	chemical products
22136	Reaction product of tetrabutylzirconium with acetylacetone (1:1)	512179-63-4	Contains (regardless of intentional or impurities)	chemical products
22137	(1R)-(+)-Pinediol-1-bis(trimethylsilyl)amino-3-methylbutane-1-borionate	514820-45-0	Intentional addition / 1%	chemical products
22138	Hafnium, N-[[2,6-bis(1-methylethyl)phenyl]-alpha-[[2-(1-methylethyl)phenyl]-6-(1-naphthalenyl-kappa.C2)-2-pyridinemethanaminato(2-)-kappa.N1.kappa.N2]dimethyl-	521964-95-4	Intentional addition / 1%	chemical products
22139	Calcium chloride fluoride phosphate, antimony- and manganese-doped	545386-98-9	Contains (regardless of intentional or impurities)	chemical products
22140	1H-Pyrazole-4-boronic acid, pinacol ester, N1-BOC protected	552846-17-0	Intentional addition / 1%	chemical products
22141	4-[[Methanesulfonyl]oxy]butyl acrylate	561015-28-9	Contains (regardless of intentional or impurities)	chemical products
22142	FYS-108	569316-88-7	Intentional addition / 1,000ppm	chemical products
22143	9,9-Dimethylfluorene-2-boronic acid pinacol ester	569343-09-5	Intentional addition / 1%	chemical products
22144	2,2'-Ethylenebis(azan-1-yl-1-ylidene-kappa.N-methan-1-yl-1-ylidene)bis(phenoxy)-kappa.O)iron	578710-63-1	Contains (regardless of intentional or impurities)	chemical products
22145	2-Methylpyridine-4-boronic acid	579476-63-4	Intentional addition / 1%	chemical products
22146	Benzoic acid (2R)-5-oxo-5,6-dihydro-2H-pyran-2-yl ester	582302-79-2	Contains (regardless of intentional or impurities)	chemical products
22147	1-Methyl-1H-indazole-5-boronic acid	590418-08-9	Intentional addition / 1%	chemical products
22148	3-Methoxy-4-(methoxycarbonyl)phenylboronic acid	603122-41-4	Intentional addition / 1%	chemical products
22149	2-Chloro-4-(methoxycarbonyl)benzeneboronic acid	603122-80-1	Intentional addition / 1%	chemical products
22150	2-Fluoro-4-(methoxycarbonyl)benzeneboronic acid	603122-84-5	Intentional addition / 1%	chemical products
22151	4-Sulphamoylbenzeneboronic acid	613660-87-0	Intentional addition / 1%	chemical products
22152	4-(Methanesulfonyl)amino)phenylboronic acid pinacol ester	616880-14-9	Intentional addition / 1%	chemical products
22153	7-Oxabicyclo[2.2.1]hept-5-ene-2-sulfonic acid, methyl ester	625392-85-0	Contains (regardless of intentional or impurities)	chemical products
22154	4-[3-(Dimethylamino)propoxy]benzeneboronic acid, pinacol ester	627899-90-5	Intentional addition / 1%	chemical products
22155	2-Methoxypyrimidine-5-boronic acid	628692-15-9	Intentional addition / 1%	chemical products
22156	2-Pentenal, 5-(methoxymethoxy)-, (2E)-	629655-93-2	Contains (regardless of intentional or impurities)	chemical products
22157	4-Amino-2-methylphenylboronic acid pinacol ester	631911-01-8	Intentional addition / 1%	chemical products
22158	4-Methylthiophene-2-boronic acid pinacol ester	635305-48-5	Intentional addition / 1%	chemical products
22159	Bis(N,N'-diisopropylacetamidato)nickel(II)	635680-62-5	Contains (regardless of intentional or impurities)	chemical products
22160	10-Bromoanthracene-9-boronic acid	641144-16-3	Intentional addition / 1%	chemical products
22161	3-(2-Hydroxyethyl)benzeneboronic acid	647853-32-5	Intentional addition / 1%	chemical products
22162	1H-Benz[e]indolium, 2-[3-[[1,3-dihydro-1,3-dimethyl-1-(phenylmethyl)-2H-benz[e]indol-2-ylidene]-1-propenyl]-1,1,3-trimethyl-5-[[2-[[4-(diethylamino)-2-(hydroxy-kappa.O)phenyl]azo-kappa.N1]-4-nitrophenolato(2-)-kappa.O]cobaltate(1-)]-	652131-56-1	Intentional addition / 1%	chemical products
22163	6-Chloropyridine-2-boronic acid	652148-90-8	Intentional addition / 1%	chemical products
22164	5-Chloropyridine-2-boronic acid	652148-91-9	Intentional addition / 1%	chemical products
22165	6-Chloropyridine-2-boronic acid, pinacol ester	652148-92-0	Intentional addition / 1%	chemical products
22166	Cadmium chloride hydrate	654054-66-7	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
22167	Boric acid, B-2-triphenyl-	654664-63-8	Intentional addition / 1%	chemical products
22168	4-(2-Ethoxycarbonyl)ethylbenzeneboronic acid	660440-57-3	Intentional addition / 1%	chemical products
22169	2-Methylpyridine-4-boronic acid, pinacol ester	660867-80-1	Intentional addition / 1%	chemical products
22170	2-Pyridineboronic acid N-phenyldiethanolamine ester	662138-96-7	Intentional addition / 1%	chemical products
22171	2-p-Terphenylboronic acid	663954-31-2	Intentional addition / 1%	chemical products
22172	2-Methyl-N-(tribromoacetyl)alanine chloride	666200-91-5	Intentional addition / 1%	chemical products
22173	Boron, [[2,2-(amino-kappa)bis[ethanolato-kappa O]](2-)](1S)-4-methoxy-1-[[N-[(phenylmethoxy)carbonyl]-L-phenylalanine-D-prolyl]amino]butyl]- (T-4)-	667935-30-0	Intentional addition / 1%	chemical products
22174	4-(p-Toluenesulfonylamino)phenylboronic acid pinacol ester	674776-54-6	Intentional addition / 1%	chemical products
22175	Aluminum chloride, basic, reaction products with silica	675106-31-7	Intentional addition / 1,000ppm	chemical products
22176	4-Methoxy-5-(3-morpholinopropoxy)-2-nitrobenzotrile	675126-26-8	Intentional addition / 1%	chemical products
22177	Cuprate(5-), [5-(acetyl)amino]-4-hydroxy-3-[[5-(hydroxy-kappa O)-6-[[2-(hydroxy-kappa O)-3-sulfo-5-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]azo-kappa N1]-7-sulfo-2-naphthalenyl]azo]-2.7-naphthalenedisulfonato(7-)-, pentasodium	676123-47-0	Intentional addition / 1,000ppm	chemical products
22178	2,6-Bis(trifluoromethyl)benzeneboronic acid	681812-07-7	Intentional addition / 1%	chemical products
22179	Propanoic acid, 2,3,3,3-tetrafluoro-2-(heptafluoropropoxy)-, 1,1,2,3,3,3-hexafluoro-2-(trifluoromethyl)propyl ester	682772-46-9	Intentional addition / 1%	chemical products
22180	4-Isquinolineboronic acid pinacol ester	685103-98-4	Intentional addition / 1%	chemical products
22181	Boric acid, B-[4-(difluoro(3,4,5-trifluorophenoxy)methyl]-3,5-difluorophenyl]-	685563-69-3	Intentional addition / 1%	chemical products
22182	1,2,3-Propanetricarboxylic acid, 2-hydroxy-, chromium(3+) salt (1:1)	685853-81-0	Contains (regardless of intentional or impurities)	chemical products
22183	3-Fluoro-4-methylphenylhydrazine	687971-90-0	Intentional addition / 1%	chemical products
22184	4-(2-Morpholin-4-ylethoxy)benzeneboronic acid, pinacol ester	690636-28-3	Intentional addition / 1%	chemical products
22185	Tris(ethylenediamine)nickel(II) chloride hydrate	699012-90-3	Contains (regardless of intentional or impurities)	chemical products
22186	Benzoic acid, 4-(formylamino)-3-methoxy-, methyl ester	700834-18-0	Contains (regardless of intentional or impurities)	chemical products
22187	2-Chloroacrylate, 3,3,4,4,5,5,6,6-nonafluorohexyl	701909-41-3	Contains (regardless of intentional or impurities)	chemical products
22188	Heptanoic acid, 2,2,3,4,4,5,5,6,6,7,7,7-dodecafluoro-3-(trifluoromethyl)-	705240-04-6	Intentional addition / 1,000ppm	chemical products
22189	Cuprate(3-), [3-(hydroxy-kappa O)-4-[[2-(2-(hydroxy-kappa O)-5-sulfofenyl]diazanyl-kappa N1)-2,7-naphthalenedisulfonato(5-)]-; hydrogen (1:3)	711030-33-0	Intentional addition / 1,000ppm	chemical products
22190	Cuprate(3-), [3-(hydroxy-kappa O)-4-[[2-(2-(hydroxy-kappa O)-5-sulfofenyl]azo-kappa N1)-2,7-naphthalenedisulfonato(5-)]-	717096-44-1	Intentional addition / 1,000ppm	chemical products
22191	(1-Methyl-1H-pyrazol-5-yl)boronic acid	720702-41-0	Intentional addition / 1%	chemical products
22192	1H-Benz[e]indolium, 2-[3-[5-chloro-1,3-dihydro-1-methyl-3-bis(phenylmethyl)-2H-indol-2-ylidene]-1-propenyl]-1,3-dimethyl-1-(phenylmethyl)-, bis[2-[[4-(diethylamino)-2-(hydroxy-kappa O)phenyl]azo-kappa N1]-4-nitrophenolato(2-)-kappa O]cobaltate(1-)	728945-44-6	Intentional addition / 1%	chemical products
22193	Cuprate(3-), [C-(aminosulfonyl)-29H,31H-phthalocyanine-C,C,C-trisulfonato(5-)-kappa N29,kappa N30,kappa N31,kappa N32]-	730935-81-6	Intentional addition / 1,000ppm	chemical products
22194	5-Carboxy-2-methoxybenzeneboronic acid	730971-32-1	Intentional addition / 1%	chemical products
22195	Cuprate(3-), [C-[[[2-[[4-chloro-6-methoxy-1,3,5-triazin-2-yl]amino]ethyl]amino]sulfonyl]-29H,31H-phthalocyanine-C,C,C-trisulfonato(6-)-kappa N29,kappa N30,kappa N31,kappa N32]-	732199-83-6	Intentional addition / 1,000ppm	chemical products
22196	Cuprate(1-), [9,16,23-tris(aminosulfonyl)-29H,31H-phthalocyanine-2-sulfonato(3-)-N29,N30,N31,N32]-, (SP-4-2)-	736076-00-9	Intentional addition / 1,000ppm	chemical products
22197	Zirconium, chloro citrate hydroxy ammonium complexes	736175-02-3	Contains (regardless of intentional or impurities)	chemical products
22198	Zirconium, chloro hydroxy lactate ammonium complexes	736175-24-9	Contains (regardless of intentional or impurities)	chemical products
22199	3-(3-Hydroxyprop-1-yl)benzeneboronic acid	736989-98-3	Intentional addition / 1%	chemical products
22200	1,1'-Ferrocenediboronic acid bis(pinacol) ester	737776-93-1	Intentional addition / 1%	chemical products
22201	5-[[2-(hydroxy-3,7-disulfo-1-naphthalenyl]azo]-1H-1,2,4-triazole-3-carboxylate sodium complex nickel	738587-10-5	Contains (regardless of intentional or impurities)	chemical products
22202	Cuprate(3-), [2-[[[3-[[4-chloro-6-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa O)-5-sulfofenyl]azo-kappa N2]phenylmethyl]azo-kappa N1]-4-sulfofenzoato(5-)-kappa O]-	739339-56-1	Intentional addition / 1,000ppm	chemical products
22203	2:1 Cobalt complex of 4-(5-ethylsulfonyl)-2-hydroxy-phenylazo)-3-hydroxy-naphthalene-2-carboxylic acid phenylamide	739352-37-5	Intentional addition / 1%	chemical products
22204	Cuprate(3-), [C,C-bis(aminosulfonyl)-29H,31H-phthalocyanine-C,C,C-trisulfonato(5-)-N29,N30,N31,N32]-	740050-08-2	Intentional addition / 1,000ppm	chemical products
22205	1H-Imidazolium, 3-ethyl-1-methyl-, tetrakis(cyano-kappa O)borate(1-)(1:1)	742099-80-5	Intentional addition / 1%	chemical products
22206	Chromium hydroxide nitrate	745829-51-0	Intentional addition / 1,000ppm	chemical products
22207	4-(4-Methylpiperazin-1-yl)benzeneboronic acid, pinacol ester	747413-21-4	Intentional addition / 1%	chemical products
22208	Cuprate(4-), [C-[[[3-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-2-sulfofenyl]amino]sulfonyl]-29H,31H-phthalocyanine-C,C,C-trisulfonato(6-)-kappa N29,kappa N30,kappa N31,kappa N32]-	748705-84-2	Intentional addition / 1,000ppm	chemical products
22209	Tungsten carbide cobalt alloy (96:4)	749216-83-9	Intentional addition / 1%	chemical products
22210	Dihydrogen [[[[4-hydroxy-3-[[2-oxo-1-(phenylcarbamoyl)propyl]azo]phenyl]sulfonyl]amino]benzoato(3-)](2-)-[[2-(hydroxy-5-(phenylsulfamoyl)phenyl]azo)-3-oxobutyranilidato(2-)-]cobaltate(2-)	749798-18-3	Intentional addition / 1%	chemical products
22211	Cuprate(3-), [8-(hydroxy-kappa O)-7-[[2-[[2-(hydroxy-kappa O)-5-[[2-(hydroxyethyl)sulfonyl]phenyl]azo-kappa N1]-1,3,6-	749887-18-1	Intentional addition / 1,000ppm	chemical products
22212	Cuprate(2-), [16,23-bis(aminosulfonyl)-29H,31H-phthalocyanine-2,9-disulfonato(4-)-N29,N30,N31,N32]-, (SP-4-2)-	752139-51-8	Intentional addition / 1,000ppm	chemical products
22213	Cuprate(2-), [C,C-bis(aminosulfonyl)-29H,31H-phthalocyanine-C,C-disulfonato(4-)-N29,N30,N31,N32]-	752152-93-5	Intentional addition / 1,000ppm	chemical products
22214	Cuprate(4-), [2-[[[3-[[4-chloro-6-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa O)-5-sulfofenyl]azo-kappa N2]phenylmethyl]azo-kappa N1]-4-sulfofenzoato(6-)-kappa O]-, (SP-4-3)-	752157-53-2	Intentional addition / 1,000ppm	chemical products
22215	Boron, trifluoro(tetrahydrofuran)-, (T-4)-, polymer with 3-methyl-3-[[[3,3,4,4,5,5,6,6,6-nonafluorohexyloxy]methyl]oxetane, ether with 2,2-dimethyl-1,3-propanediol (2:1)	753501-42-7	Intentional addition / 1%	chemical products
22216	Cuprate(3-), [5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-hydroxy-3-[[2-(hydroxy-4-sulfo-1-naphthalenyl]azo)-2,7-naphthalenedisulfonato(5-)]-	754935-23-4	Intentional addition / 1,000ppm	chemical products
22217	4-(4-Amino-3-fluorophenoxy)pyridine-2-carboxamide	757251-54-0	Contains (regardless of intentional or impurities)	chemical products
22218	Cobaltate(5-), bis[5-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-4-(hydroxy-kappa O)-3-[[2-(hydroxy-kappa O)-5-nitrophenyl]azo-kappa N1]-2,7-naphthalenedisulfonato(4-)]-	758634-43-4	Intentional addition / 1%	chemical products
22219	Cuprate(4-), [2-[[[3-[[4-chloro-6-[[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa O)-5-sulfofenyl]azo]phenylmethyl]azo-kappa N1]-4-sulfofenzoato(6-)-	760902-85-0	Intentional addition / 1,000ppm	chemical products
22220	3-Amino-4-hydroxyphenylboronic acid pinacol ester	760990-10-1	Intentional addition / 1%	chemical products
22221	1-Benzyl-1H-pyrazole-4-boronic acid, pinacol ester	761446-45-1	Intentional addition / 1%	chemical products
22222	2-Methoxypyridine-4-boronic acid	762262-09-9	Intentional addition / 1%	chemical products
22223	2-Fluoro-3-methylbenzeneboronic acid	762287-58-1	Intentional addition / 1%	chemical products
22224	3-Fluoro-2-methoxybenzeneboronic acid	762287-59-2	Intentional addition / 1%	chemical products
22225	Cuprate(1-), [C,C,C-tris(aminosulfonyl)-29H,31H-phthalocyanine-C-sulfonato(3-)-kappa N29,kappa N30,kappa N31,kappa N32]-	763020-68-4	Intentional addition / 1,000ppm	chemical products
22226	1H-Pyrazole-4-boronic acid	763120-58-7	Intentional addition / 1%	chemical products
22227	Cuprate(4-), [3-[[[3-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-1-(hydroxy-kappa O)-3,6-disulfo-2-naphthalenyl]azo-kappa N1]-4-(hydroxy-kappa O)-1,5-naphthalenedisulfonato(6-)]-	774132-85-3	Intentional addition / 1,000ppm	chemical products
22228	Tetrasodium bis[[[4-(5-dicyanomido)azol-2-yl]diazanyl]-2-oxidonaphthalene-6-sulfonato]nickelate(II)	774180-11-9	Intentional addition / 1,000ppm	chemical products
22229	Cuprate(3-), [2-[[[3-(acetyl)amino]-2-hydroxy-5-sulfofenyl]azo]phenylmethyl]azo-5-sulfofenzoato(5-)]-	775235-53-5	Intentional addition / 1,000ppm	chemical products
22230	2-Benzoyloxy-5-fluorophenylboronic acid	779331-47-4	Intentional addition / 1%	chemical products
22231	1H-Pyrazole-3-carboxylic acid, 4,5-dihydro-5-oxo-1-(4-sulfofenyl)-4-[2-(4-sulfofenyl)diazanyl]-, zirconium salt (1:?)	787550-74-7	Contains (regardless of intentional or impurities)	chemical products
22232	Methacrylic acid tricyclo[3.3.1.1.3]decane-2-yloxymethyl ester	791611-93-3	Contains (regardless of intentional or impurities)	chemical products
22233	2-Hydroxy-3-[2-(2-methoxyethoxy)-5-nitropyridine-4-yl]propanoic acid ethyl ester	794470-22-7	Contains (regardless of intentional or impurities)	chemical products
22234	Benzol[b]furan-3-boronic acid, pinacol ester	796851-30-4	Intentional addition / 1%	chemical products
22235	4-(Carboxymethyl)phenylboronic acid pinacol ester	797755-07-8	Intentional addition / 1%	chemical products
22236	1-Tridecanamine, N-tridecyl-, branched, reaction products with carbon disulfide, 2-ethyl-N-(2-ethylhexyl)-1-hexanamine and molybdenum oxide (MoO3)	799241-27-3	Intentional addition / 1,000ppm	chemical products
22237	2,4-Dinitro-N,N-di-2-propen-1-ylbenzenamine	816461-30-0	Intentional addition / 1%	chemical products
22238	2-Amino-3-pyridine-5-boronic acid pinacol ester	827614-64-2	Intentional addition / 1%	chemical products
22239	1-Propyl-1H-pyrazole-4-boronic acid pinacol ester	827614-69-7	Intentional addition / 1%	chemical products
22240	4-(4-Methylpiperazine-1-carbonyl)phenylboronic acid pinacol ester	832114-06-4	Intentional addition / 1%	chemical products
22241	2-(Dimethylamino)phenylboronic acid pinacol ester	832114-08-6	Intentional addition / 1%	chemical products
22242	4-[[2-(Dimethylamino)ethyl]carbamoyl]phenylboronic acid pinacol ester	832114-11-1	Intentional addition / 1%	chemical products
22243	2,2-Dimethylpropanoic acid (TR)-3-chloro-1-methyl-2-oxopropyl ester	832151-99-2	Contains (regardless of intentional or impurities)	chemical products
22244	4-Cyano-3-fluorophenylboronic acid	843663-18-3	Intentional addition / 1%	chemical products
22245	Boric acid, B-[2-[[2-(1-methyl-1-phenylethyl)-2H-tetrazol-5-yl]phenyl]-	844681-82-9	Intentional addition / 1%	chemical products
22246	1,3,5-Trimethyl-1H-pyrazole-4-boronic acid pinacol ester	844891-04-9	Intentional addition / 1%	chemical products
22247	4-Benzoyloxy-3-chlorophenylboronic acid	845551-44-2	Intentional addition / 1%	chemical products
22248	3,5-Difluoro-4-formylphenylboronic acid	845551-45-3	Intentional addition / 1%	chemical products
22249	4-(Methylamino)phenylboronic acid pinacol ester	845870-55-5	Intentional addition / 1%	chemical products
22250	3-Pyridineboronic acid neopentylglycol ester	845885-86-1	Intentional addition / 1%	chemical products
22251	2-Propenoyl chloride, 3-[4-(1-methylethyl)phenyl]-	846352-80-5	Intentional addition / 1%	chemical products
22252	3-Chloro-4-(trifluoromethyl)benzeneboronic acid	847756-88-1	Intentional addition / 1%	chemical products
22253	1-Methyl-1H-pyrazole-4-boronic acid	847818-55-7	Intentional addition / 1%	chemical products
22254	1-Ethyl-1H-pyrazole-4-boronic acid pinacol ester	847818-70-6	Intentional addition / 1%	chemical products
22255	1-Methyl-1H-pyrazole-5-boronic acid pinacol ester	847818-74-0	Intentional addition / 1%	chemical products
22256	1,3-Dimethyl-1H-pyrazole-5-boronic acid, pinacol ester	847818-79-5	Intentional addition / 1%	chemical products
22257	6-Difluoro-1-(2-fluoroethyl)-8-methoxy-4-oxo-1,4-dihydroquinoline-3-carboxylic acid diacetoxymethyl ester	848498-67-9	Intentional addition / 1%	chemical products
22258	2-Benzoyloxy-4-fluorophenylboronic acid	848779-87-3	Intentional addition / 1%	chemical products
22259	3-Bromo-2-(4-chlorobenzoyloxy)-5-methylphenylboronic acid	849052-15-9	Intentional addition / 1%	chemical products
22260	4-(4-Chlorobenzoyloxy)-3,5-dimethylphenylboronic acid	849052-17-1	Intentional addition / 1%	chemical products
22261	3-Bromo-2-(4-fluorobenzoyloxy)-5-methylphenylboronic acid	849052-18-2	Intentional addition / 1%	chemical products
22262	3-Bromo-2-(4-chlorobenzoyloxy)phenylboronic acid	849052-19-3	Intentional addition / 1%	chemical products
22263	2-Bromo-6-fluoro-3-propoxyphenylboronic acid	849052-20-6	Intentional addition / 1%	chemical products
22264	3-Isobutoxyphenylboronic acid	849052-23-9	Intentional addition / 1%	chemical products
22265	3-Bromo-2-(3-Methoxybenzyloxy)phenylboronic acid	849052-24-0	Intentional addition / 1%	chemical products
22266	Boric acid, B-cyclobutyl-	849052-26-2	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
22267	(E)-2-Cyclopropylethylene-1-boronic acid, pinacol ester	849061-99-0	Intentional addition / 1%	chemical products
22268	2,6-Difluoro-3-ethoxyphenylboronic acid	849062-00-6	Intentional addition / 1%	chemical products
22269	2,6-Difluoro-3-(3,5-dimethoxybenzyloxy)phenylboronic acid	849062-01-7	Intentional addition / 1%	chemical products
22270	3-(4-Heptyloxyphenoxy)methylphenylboronic acid	849062-03-9	Intentional addition / 1%	chemical products
22271	(2,6-Difluoro-3-propen-2-yloxyphenyl)boronic acid	849062-04-0	Intentional addition / 1%	chemical products
22272	4-[(2-Chloro-5-(trifluoromethyl)phenoxy)methyl]phenylboronic acid	849062-05-1	Intentional addition / 1%	chemical products
22273	2-[(1,2,3,4-Tetrahydro-5-naphthyl)oxy)methyl]phenylboronic acid	849062-06-2	Intentional addition / 1%	chemical products
22274	2-[(4-(Trifluoromethoxy)phenoxy)methyl]phenylboronic acid	849062-07-3	Intentional addition / 1%	chemical products
22275	(2,6-Difluoro-3-formylphenyl)boronic acid	849062-09-5	Intentional addition / 1%	chemical products
22276	2-[(1,2,3,4-Tetrahydro-5-naphthyl)oxy)methyl]phenylboronic acid	849062-10-8	Intentional addition / 1%	chemical products
22277	3-(4-(Trifluoromethoxy)phenoxy)methylphenylboronic acid	849062-11-1	Intentional addition / 1%	chemical products
22278	3-Bromo-2-(2-fluorobenzyloxy)-5-methylphenylboronic acid	849062-18-6	Intentional addition / 1%	chemical products
22279	4-(4-Propoxyphenyl)phenylboronic acid	849062-20-0	Intentional addition / 1%	chemical products
22280	3-Bromo-2-(3-chlorobenzyloxy)-5-methylphenylboronic acid	849062-21-1	Intentional addition / 1%	chemical products
22281	3-Bromo-5-methyl-2-(3-methoxybenzyloxy)phenylboronic acid	849062-23-3	Intentional addition / 1%	chemical products
22282	3-Chloro-4-(3-chlorobenzyloxy)phenylboronic acid	849062-26-6	Intentional addition / 1%	chemical products
22283	4,5-Difluoro-2-methoxyphenylboronic acid	849062-29-9	Intentional addition / 1%	chemical products
22284	5-Butoxy-2-fluorophenylboronic acid	849062-31-3	Intentional addition / 1%	chemical products
22285	2-(3-Chlorobenzyloxy)phenylboronic acid	849062-32-4	Intentional addition / 1%	chemical products
22286	3-Bromo-2-(3-bromobenzyloxy)-5-methylphenylboronic acid	849062-38-0	Intentional addition / 1%	chemical products
22287	3-Bromo-2-(3-fluorobenzyloxy)-5-methylphenylboronic acid	849062-40-4	Intentional addition / 1%	chemical products
22288	3-Fluoro-4-(methylcarbamoyl)benzeneboronic acid	849833-86-9	Intentional addition / 1%	chemical products
22289	2-Methyl-4-(trifluoromethoxy)benzeneboronic acid	850033-39-5	Intentional addition / 1%	chemical products
22290	Afatinib dimaleate	850140-73-7	Contains (regardless of intentional or impurities)	chemical products
22291	3-(Methoxycarbonyl)benzeneboronic acid	850567-26-9	Intentional addition / 1%	chemical products
22292	3-(2-Dimethylaminoethylaminocarbonyl)benzeneboronic acid	850567-31-6	Intentional addition / 1%	chemical products
22293	3-[(2-Methoxyethyl)carbamoyl]benzeneboronic acid	850567-33-8	Intentional addition / 1%	chemical products
22294	3-[(4-Fluorophenyl)aminocarbonyl]benzeneboronic acid	850567-35-0	Intentional addition / 1%	chemical products
22295	3-(Thiomorpholin-4-ylcarbonyl)benzeneboronic acid	850567-37-2	Intentional addition / 1%	chemical products
22296	1-Methyl-1H-pyrrole-2-boronic acid, pinacol ester	850567-47-4	Intentional addition / 1%	chemical products
22297	4-Methyl-1-cyclohexen-1-ylboronic acid	850567-92-9	Intentional addition / 1%	chemical products
22298	4-(Isopropylsulphonyl)benzeneboronic acid	850567-98-5	Intentional addition / 1%	chemical products
22299	4-Fluoro-2-hydroxybenzeneboronic acid	850568-00-2	Intentional addition / 1%	chemical products
22300	4-Ethoxy-3-methylbenzeneboronic acid	850568-08-0	Intentional addition / 1%	chemical products
22301	4-(2-Cyanoethylaminocarbonyl)benzeneboronic acid	850568-16-0	Intentional addition / 1%	chemical products
22302	4-[[2-(Dimethylamino)ethyl]carbamoyl]benzeneboronic acid hydrochloride	850568-22-8	Intentional addition / 1%	chemical products
22303	4-[[Acetylamino)methyl]benzeneboronic acid	850568-41-1	Intentional addition / 1%	chemical products
22304	4-E-3-Ethoxy-3-oxo-1-propen-1-yl)benzeneboronic acid	850568-49-9	Intentional addition / 1%	chemical products
22305	6-Methyl-1H-indole-2-boronic acid, N-BOC protected	850568-51-3	Intentional addition / 1%	chemical products
22306	3-[(E)-2-Cyanovinyl]benzeneboronic acid	850568-53-5	Intentional addition / 1%	chemical products
22307	4-(tert-Butoxycarbonyl)benzeneboronic acid	850568-54-6	Intentional addition / 1%	chemical products
22308	4-Chloro-2-(ethoxycarbonyl)benzeneboronic acid	850568-61-5	Intentional addition / 1%	chemical products
22309	5-Benzyloxy-1H-indole-2-boronic acid, N-BOC protected	850568-62-6	Intentional addition / 1%	chemical products
22310	6-Methoxy-1H-indole-2-boronic acid, N-BOC protected	850568-65-9	Intentional addition / 1%	chemical products
22311	3-Aminophenyl)benzeneboronic acid	850568-74-0	Intentional addition / 1%	chemical products
22312	3-Fluoro-5-isopropoxybenzeneboronic acid	850589-54-7	Intentional addition / 1%	chemical products
22313	4-(2-Hydroxyethylcarbamoyl)benzeneboronic acid	850593-04-3	Intentional addition / 1%	chemical products
22314	Cuprate(2-), [15,22-bis(aminosulfonyl)-29H,31H-phthalocyanine-1,8-disulfonato(4-)-kappa.N29.kappa.N30.kappa.N31.kappa.N32]-, dihydrogen, (SP-4-2)-	850813-15-9	Intentional addition / 1,000ppm	chemical products
22315	5-Methoxypyridine-3-boronic acid	850991-69-4	Intentional addition / 1%	chemical products
22316	Cuprate(2-), [15,22-bis(aminosulfonyl)-29H,31H-phthalocyanine-1,8-disulfonato(4-)-kappa.N29.kappa.N30.kappa.N31.kappa.N32]-, (SP-4-2)-	850994-04-6	Intentional addition / 1,000ppm	chemical products
22317	Benzene, 1-(cyclopropylthio)-4-nitro-	851008-48-5	Intentional addition / 1%	chemical products
22318	4-Carboxy-2-fluorobenzenesulfonic acid	851335-07-4	Intentional addition / 1%	chemical products
22319	L-Valine, N-[[2-(1H-tetrazol-5-yl)[1,1'-biphenyl]-4-yl]methyl]-, barium salt (2:1)	852178-29-1	Intentional addition / 1%	chemical products
22320	6-(Piperidin-1-yl)pyridine-3-boronic acid, pinacol ester	852228-08-1	Intentional addition / 1%	chemical products
22321	Benzeneacetonitrile, 2-methyl- alpha-[2-[(propylsulfonyloxy)imino]-3(2H)-thienylidene]-	852246-55-0	Contains (regardless of intentional or impurities)	chemical products
22322	1-Benzyl-1H-pyrazole-4-boronic acid	852362-22-2	Intentional addition / 1%	chemical products
22323	2-Fluoro-4-nitro-Benzeneacetonitrile	853910-00-6	Contains (regardless of intentional or impurities)	chemical products
22324	Boron calcium oxide (B6Ca2O11), pentahydrate	854267-07-5	Intentional addition / 1%	chemical products
22325	Arsine, chloromethyl(m-nitrophenyl)-	855954-34-6	Contains (regardless of intentional or impurities)	chemical products
22326	(1R)-8-Chloro-1-methyl-2,3,4,5-tetrahydro-1H-3-benzazepine hydrochloride hemihydrate	856681-05-5	Contains (regardless of intentional or impurities)	chemical products
22327	3,5-Dimethylpyrazole-4-boronic acid, pinacol ester	857530-80-4	Intentional addition / 1%	chemical products
22328	Cuprate(3-), [3-(hydroxy-kappa.O)-4-[[2-(hydroxy-kappa.O)-5-sulfonyl]azo-kappa.N1]-2,7-naphthalenedisulfonato(5-)]-, tritium	857641-44-2	Intentional addition / 1,000ppm	chemical products
22329	4-[[Ethoxycarbonyl)methyl]phenylboronic acid pinacol ester	859169-20-3	Intentional addition / 1%	chemical products
22330	Propanedioic acid, [[4-(phenoxyphenyl)amino]-, diethyl ester	861640-76-8	Contains (regardless of intentional or impurities)	chemical products
22331	2-Isopropylbicyclo[4.4.0]decane or 3-isopropylbicyclo[4.4.0]decane	861642-00-4	Intentional addition / 1%	chemical products
22332	2,3-Dichloropropanoate 3,3,4,4,5,5,6,6-nonafuoroheptyl	862161-28-2	Contains (regardless of intentional or impurities)	chemical products
22333	Bis[2-(pentamethylphenylamino)ethyl]amine	862464-60-6	Contains (regardless of intentional or impurities)	chemical products
22334	1H-Indazole-5-boronic acid pinacol ester	862723-42-0	Intentional addition / 1%	chemical products
22335	2-Aminophenylboronic acid hydrochloride	863753-30-4	Intentional addition / 1%	chemical products
22336	2,6-Difluoro-4-formylphenylboronic acid	863975-37-5	Intentional addition / 1%	chemical products
22337	3-(9H-Carbazol-9-yl)phenylboronic acid	864377-33-3	Intentional addition / 1%	chemical products
22338	1-(Ethoxycarbonylmethyl)-1H-pyrazole-4-boronic acid pinacol ester	864754-16-5	Intentional addition / 1%	chemical products
22339	1-(2-Morpholinoethyl)-1H-pyrazole-4-boronic acid pinacol ester	864754-18-7	Intentional addition / 1%	chemical products
22340	2-Bromo-3-pyridineboronic acid pinacol ester	865812-10-8	Intentional addition / 1%	chemical products
22341	4,4-Dimethylcyclohexen-1-ylboronic acid	865869-28-9	Intentional addition / 1%	chemical products
22342	3-(Difluoromethoxy)benzeneboronic acid	866607-09-2	Intentional addition / 1%	chemical products
22343	Boronic acid, B-[4-(2-phenyl-1H-benzimidazol-1-yl)phenyl]-	867044-33-5	Intentional addition / 1%	chemical products
22344	4-[6-(tributylstannyl)-2-pyridinyl]morpholine	869901-24-6	Contains (regardless of intentional or impurities)	chemical products
22345	4-[[Trimethylsilyl]ethyl]phenylboronic acid pinacol ester	870238-65-6	Intentional addition / 1%	chemical products
22346	Boronic acid, B-[6-(1-methylethoxy)-3-pyridinyl]-	870521-30-5	Intentional addition / 1%	chemical products
22347	2-(p-Toluenesulfonylamino)phenylboronic acid pinacol ester	870704-19-1	Intentional addition / 1%	chemical products
22348	2,6-Difluoro-4-formylphenylboronic acid pinacol ester	870717-92-3	Intentional addition / 1%	chemical products
22349	1-(Phenylsulfonyl)indole-3-boronic acid pinacol ester	870717-93-4	Intentional addition / 1%	chemical products
22350	4-(4-Isopropoxyphenyl)phenylboronic acid	870717-98-9	Intentional addition / 1%	chemical products
22351	3-Bromo-5-methyl-2-methoxyphenylboronic acid	870717-99-0	Intentional addition / 1%	chemical products
22352	3-Bromo-2-ethoxy-5-methylphenylboronic acid	870718-00-6	Intentional addition / 1%	chemical products
22353	2,4-Difluoro-3-formylphenylboronic acid	870718-06-2	Intentional addition / 1%	chemical products
22354	2-Benzyloxy-5-chlorobenzeneboronic acid	870717-21-2	Intentional addition / 1%	chemical products
22355	Boronic acid, B-(5-acetyl-2-fluorophenyl)-	870717-29-0	Intentional addition / 1%	chemical products
22356	trans-3-Bromo-1-propen-1-ylboronic acid pinacol ester	870717-31-4	Intentional addition / 1%	chemical products
22357	4,5-Difluoro-2-methoxyphenylboronic acid	870717-32-5	Intentional addition / 1%	chemical products
22358	4-(3-Chlorobenzyloxy)-3,5-dimethylphenylboronic acid	870718-83-9	Intentional addition / 1%	chemical products
22359	4,5-Difluoro-2-ethoxyphenylboronic acid	870718-87-3	Intentional addition / 1%	chemical products
22360	2,4-Dibutoxyphenylboronic acid	870718-89-5	Intentional addition / 1%	chemical products
22361	3-(4'-Chlorobenzyloxy)phenylboronic acid	870718-90-8	Intentional addition / 1%	chemical products
22362	4-(4'-Chlorobenzyloxy)phenylboronic acid	870718-91-9	Intentional addition / 1%	chemical products
22363	2,6-Difluoro-3-(2-chlorobenzyloxy)phenylboronic acid	870718-93-1	Intentional addition / 1%	chemical products
22364	2,4-Dibromo-6-fluorophenylboronic acid	870718-96-4	Intentional addition / 1%	chemical products
22365	4-(4-(Trifluoromethoxy)phenoxy)methylphenylboronic acid	870718-99-7	Intentional addition / 1%	chemical products
22366	4-[(4-(2-Methoxyethyl)phenoxy)methyl]phenylboronic acid	870719-00-3	Intentional addition / 1%	chemical products
22367	Boronic acid, B-(2,6-difluoro-3-methoxyphenyl)-	870719-02-5	Intentional addition / 1%	chemical products
22368	3-Formyl-5-propoxyphenylboronic acid	871125-80-3	Intentional addition / 1%	chemical products
22369	7-Chloroquinoline-4-boronic acid, pinacol ester	871125-83-6	Intentional addition / 1%	chemical products
22370	6-(1-Piperazinyl)pyridine-3-boronic acid pinacol ester	871125-86-9	Intentional addition / 1%	chemical products
22371	3-(p-Toluenesulfonylamino)phenylboronic acid pinacol ester	871125-91-6	Intentional addition / 1%	chemical products
22372	3-(3,5-Dimethoxybenzyloxy)phenylboronic acid	871125-94-9	Intentional addition / 1%	chemical products
22373	3-(3'-Chlorobenzyloxy)phenylboronic acid	871125-95-0	Intentional addition / 1%	chemical products
22374	3-Bromo-2-(2-fluorobenzyloxy)-5-methylphenylboronic acid	871125-97-2	Intentional addition / 1%	chemical products
22375	4-(2-Chlorobenzyloxy)-3,5-dimethylphenylboronic acid	871125-98-3	Intentional addition / 1%	chemical products
22376	3-Bromo-2-(2-chlorobenzyloxy)-5-methylphenylboronic acid	871126-00-0	Intentional addition / 1%	chemical products
22377	4-[(4'-Chloro-3-methylphenoxy)methyl]phenylboronic acid	871126-05-5	Intentional addition / 1%	chemical products
22378	(3-Fluoro-2-formylphenyl)boronic acid	871126-15-7	Intentional addition / 1%	chemical products
22379	4-Butoxy-2,3,5,6-tetrafluorophenylboronic acid	871126-19-1	Intentional addition / 1%	chemical products
22380	3-(2'-Chloro-5-(trifluoromethyl)phenoxy)methylphenylboronic acid	871126-25-9	Intentional addition / 1%	chemical products
22381	4-Butoxy-2,3,5,6-tetrafluorophenylboronic acid	871126-28-2	Intentional addition / 1%	chemical products
22382	2-Chloro-3-fluorobenzeneboronic acid	871329-52-1	Intentional addition / 1%	chemical products
22383	3-(N,N-Dimethylsulphonamido)benzeneboronic acid	871329-59-8	Intentional addition / 1%	chemical products
22384	3-(morpholin-4-ylsulphonyl)benzeneboronic acid	871329-60-1	Intentional addition / 1%	chemical products
22385	3-Fluoro-5-hydroxybenzeneboronic acid	871329-82-7	Intentional addition / 1%	chemical products
22386	4-Chloro-3-cyanobenzeneboronic acid	871332-95-5	Intentional addition / 1%	chemical products
22387	3-Methoxy-5-(trifluoromethyl)phenylboronic acid	871332-97-7	Intentional addition / 1%	chemical products
22388	5-(N,N-Dimethylsulphamoyl)-2-methylbenzeneboronic acid	871332-99-9	Intentional addition / 1%	chemical products
22389	2-Methyl-5-(pyrrolidin-1-ylsulphonyl)benzeneboronic acid	871333-01-6	Intentional addition / 1%	chemical products
22390	4-Methoxy-3-(morpholin-4-ylsulphonyl)benzeneboronic acid	871333-02-7	Intentional addition / 1%	chemical products
22391	Bicyclo[2.2.1]hept-2-en-2-ylboronic acid	871333-98-1	Intentional addition / 1%	chemical products
22392	5-Chloropyridine-3-boronic acid	872041-85-5	Intentional addition / 1%	chemical products
22393	5-Fluoropyridine-3-boronic acid	872041-86-6	Intentional addition / 1%	chemical products
22394	5-Methylpyridine-2-boronic acid N-phenyldiethanolamine ester	872054-54-1	Intentional addition / 1%	chemical products
22395	6-Methyl-2-pyridineboronic acid N-phenyldiethanolamine ester	872054-57-4	Intentional addition / 1%	chemical products
22396	6-Methoxy-2-pyridineboronic acid N-phenyldiethanolamine ester	872054-59-6	Intentional addition / 1%	chemical products
22397	Benzoic acid, 5-borono-2-fluoro-	872460-12-3	Intentional addition / 1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
22398	3,4-Difluorobiphenyl-2-amine	873056-62-3	Contains (regardless of intentional or impurities)	chemical products
22399	4-[[2-(Dimethylamino)ethoxy]benzeneboronic acid, pinacol ester	873078-93-4	Intentional addition / 1%	chemical products
22400	3-Amino-4-fluorobenzeneboronic acid	873566-75-7	Intentional addition / 1%	chemical products
22401	Pyridine-2-boronic acid, pinacol ester	874186-98-8	Intentional addition / 1%	chemical products
22402	2-(Dimethylcarbamoyl)benzeneboronic acid	874219-16-6	Intentional addition / 1%	chemical products
22403	3-(Dimethylcarbamoyl)-4-fluorobenzeneboronic acid	874219-27-9	Intentional addition / 1%	chemical products
22404	3-(Dimethylcarbamoyl)-5-nitrobenzeneboronic acid	874219-44-0	Intentional addition / 1%	chemical products
22405	4-Methoxy-3-(pyrrolidin-1-yl)sulfonylbenzeneboronic acid	874219-52-0	Intentional addition / 1%	chemical products
22406	4-(Ethylocarbonyl)-3-fluorobenzeneboronic acid	874289-12-0	Intentional addition / 1%	chemical products
22407	4-(Dimethylcarbamoyl)-3-fluorobenzeneboronic acid	874289-13-1	Intentional addition / 1%	chemical products
22408	2-Fluoro-5-(methoxycarbonyl)benzeneboronic acid	874289-50-4	Intentional addition / 1%	chemical products
22409	Boronic acid, B-[2-fluoro-5-(methoxycarbonyl)benzeneboronic acid]	874289-59-5	Intentional addition / 1%	chemical products
22410	4-(Benzoyloxycarbonylamino)-2-fluorophenylboronic acid	874289-59-5	Intentional addition / 1%	chemical products
22411	Carbonic acid 2-ethyl-3,7-dimethyl-6-[4-(trifluoromethoxy)phenoxy]-4-quinolinyl methyl ester	875775-74-9	Intentional addition / 1%	chemical products
22412	4-(Carbamoylamino)benzeneboronic acid, pinacol ester	877134-77-5	Intentional addition / 1%	chemical products
22413	4-Amino-2-chlorophenylboronic acid pinacol ester	877180-63-9	Intentional addition / 1%	chemical products
22414	2-(2-Chloro-5-nitrophenyl)pyridine	879088-40-1	Intentional addition / 1%	chemical products
22415	Chromium, [3-(hydroxy-kappa O)-4-[[2-[[2-(hydroxy-kappa O)-1-naphthalenyl]diazanyl-kappa N1]-7-nitro-1-naphthalenesulfonato(3-)]-], reaction products with 6-amino-4-hydroxy-2-naphthalenesulfonic acid, 2-[[4-(aminophenyl)sulfonyl]ethyl hydrogen sulfate, diazotized 2-amino-4-nitrophenol and 2,4,6-trichloro-1,3,5-triazine, sodium salts	879214-58-1	Intentional addition / 1,000ppm	chemical products
22416	Bis(ethylcyclopentadienyl)dimethylhafnium	879658-26-1	Intentional addition / 1%	chemical products
22417	1,2,3-Trimethyl-3H-benz[e]indole	881219-73-4	Intentional addition / 1%	chemical products
22418	3,5-Dicarboxybenzeneboronic acid	881302-73-4	Intentional addition / 1%	chemical products
22419	2-Fluoro-5-(trifluoromethoxy)benzeneboronic acid	881402-22-8	Intentional addition / 1%	chemical products
22420	5-Amino-2-methylphenylboronic acid pinacol ester	882670-69-1	Intentional addition / 1%	chemical products
22421	3-Amino-2-methylphenylboronic acid pinacol ester	882678-96-8	Intentional addition / 1%	chemical products
22422	Disodium [7-amino-4-(hydroxy-kappa O)-3-[[2-[[2-(hydroxy-kappa O)-5-sulfonyl]azo-kappa N1]-4,5-dimethoxyphenyl]azo-kappa N1]-2-naphthalenesulfonato(4-)]cuprate(2-), reaction products with 2-[[4-[[2-(aminopropyl)amino]-6-fluoro-1,3,5-triazin-2-yl]amino]-1,4-benzenedisulfonic acid disodium salt and 2,4,6-trifluoro-1,3,5-triazine	882878-51-5	Intentional addition / 1,000ppm	chemical products
22423	1-Methyl-1H-indole-6-boronic acid, pinacol ester	884507-19-1	Intentional addition / 1%	chemical products
22424	Benzeneacetic acid, 3-borono-alpha, alpha-dimethyl-	885068-00-8	Intentional addition / 1%	chemical products
22425	3-Methylthiophene-2-boronic acid, pinacol ester	885692-91-1	Intentional addition / 1%	chemical products
22426	1-Methyl-1H-indazole-4-boronic acid pinacol ester	885698-94-2	Intentional addition / 1%	chemical products
22427	2-Isocyanato-2-methylpropane-1,3-diyli bis(3-chloropropanoate)	886443-51-2	Contains (regardless of intentional or impurities)	chemical products
22428	4-(2,2,2-Trifluoroethoxy)benzeneboronic acid	886536-37-4	Intentional addition / 1%	chemical products
22429	4-Pentenylboronic acid	886747-03-1	Intentional addition / 1%	chemical products
22430	2-Methoxyquinoline-3-boronic acid	886853-93-6	Intentional addition / 1%	chemical products
22431	2-[N-Benzyl-N-(2R)-2-chloropropyl]aminoacetic acid tert-butyl ester	888494-24-4	Contains (regardless of intentional or impurities)	chemical products
22432	Reaction mass of N,N-didecyl-N,N-dimethylammonium carbonate and N,N-didecyl-N,N-dimethylammonium bicarbonate	894406-76-9	Intentional addition / 1,000ppm	chemical products
22433	Cuprate (3-), [2-[[[3-amino-2-(hydroxy-kappa O)-5-sulfonyl]azo-kappa N2]phenylmethyl]azo-kappa N1]-4-sulfobenzato(5-)-kappa O]-trisodium, reaction products with 2-[[[2-(4,6-difluoro-1,3,5-triazin-2-yl)phenylamino]ethyl]sulfonyl]ethyl hydrogen sulfate	898565-48-5	Intentional addition / 1,000ppm	chemical products
22434	Boronic acid, B-(4-ethyl-3-fluoro[1,1'-biphenyl]-4-yl)-	900796-46-5	1%	chemical products
22435	1-Tetrahydro-2H-pyran-2-yl)-1H-pyrazole-5-boronic acid, pinacol ester	903550-26-5	1%	chemical products
22436	2-Acetamidopyridine-5-boronic acid pinacol ester	904326-87-0	1%	chemical products
22437	Cuprate(4-), [2-[[[3-[[4-chloro-6-ethyl[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa O)-5-sulfonyl]azo-kappa N2]phenylmethyl]azirino-kappa N1]-4-sulfobenzato(5-)-kappa O]-tetrahydrogen, (T-4)	906648-17-7	Intentional addition / 1,000ppm	chemical products
22438	Molybdenum, N,N-bis(C11-14-branched and linear alkyl)carbamodithioate oxo thioxo complexes	906665-74-5	1,000ppm	chemical products
22439	Cuprate(4-), [2-[[[3-[[4-chloro-6-ethyl[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa O)-5-sulfonyl]azo-kappa N2]phenylmethyl]azirino-kappa N1]-4-sulfobenzato(5-)-kappa O]-tetrahydrogen, (T-4)	906713-86-8	Intentional addition / 1,000ppm	chemical products
22440	Heptanoic acid, 2,2,3,3,4,4,5,5,6,6,7,7,7-dodecafluoro-5-(trifluoromethyl)-	909009-42-3	1,000ppm	chemical products
22441	Hafnium, [(rel-2' 2''-(1R,2R)-1,2-cyclohexanediylbis(methyleneoxy-kappa O)]bis[3-(9H-carbazol-9-yl)-5-methyl[1,1'-biphenyl]-2-olato-kappa O]](2-dimethyl-, (OC-6-33)-	909250-18-6	1%	chemical products
22442	Beta-(3-Fluoro-4-propyl[1,1'-biphenyl]-4-yl)boronic acid	909709-42-8	1%	chemical products
22443	4-Benzylphenylboronic acid pinacol ester	911708-01-5	1%	chemical products
22444	7-(4-Chlorobutoxy)quinoline-2(1H)-one	913183-82-8	Contains (regardless of intentional or impurities)	chemical products
22445	4-[[4-(2-Hydroxyethyl)piperazin-1-yl]carbonyl]benzeneboronic acid hydrochloride	913835-44-6	1%	chemical products
22446	4-(N-Acetylsulphamoyl)benzeneboronic acid	913835-52-6	1%	chemical products
22447	4-(N-Hydroxycarbamidoyl)benzeneboronic acid	913835-61-7	1%	chemical products
22448	[1-(tert-Butyldimethylsilyl)-1H-indol-5-yl]boronic acid	913835-68-4	1%	chemical products
22449	3-Amino-5-carboxybenzeneboronic acid, N-BOC protected	913835-72-0	1%	chemical products
22450	4-Fluoro-3-hydroxybenzeneboronic acid	913835-74-2	1%	chemical products
22451	7-Methoxy-1H-indole-2-boronic acid, N-BOC protected	913835-81-1	1%	chemical products
22452	2-Carboxythiophene-4-boronic acid	913835-91-3	1%	chemical products
22453	6-(Hydroxymethyl)pyridine-3-boronic acid	913835-98-0	1%	chemical products
22454	5-(Methylsulphonyl)pyridine-3-boronic acid	913836-01-8	1%	chemical products
22455	5-Carboxypyridine-3-boronic acid	913836-03-0	1%	chemical products
22456	3-[[4-(Methoxybenzyl)sulphamoyl]benzeneboronic acid	913836-05-2	1%	chemical products
22457	6-Chloro-4-methylpyridine-3-boronic acid	913836-08-5	1%	chemical products
22458	6-Carboxypyridine-3-boronic acid	913836-11-0	1%	chemical products
22459	6-Chloro-2-methylpyridine-3-boronic acid	913836-15-4	1%	chemical products
22460	4-(Dibromomethyl)-3-methoxybenzotriazole	914106-35-7	Contains (regardless of intentional or impurities)	chemical products
22461	3-Chloro-5-cyanophenylboronic acid	915763-60-9	1%	chemical products
22462	[5-(Prop-1-ynyl)pyridin-3-yl]boronic acid	917471-30-8	1%	chemical products
22463	3-Acetoxy-4-methoxybenzeneboronic acid, pinacol ester	917757-44-9	1%	chemical products
22464	6-(4-Methylpiperazin-1-yl)pyridine-3-boronic acid, pinacol ester	918524-63-7	1%	chemical products
22465	6-[3-(Dimethylamino)propoxy]pyridine-3-boronic acid pinacol ester	918643-56-8	1%	chemical products
22466	Boronic acid, B-[4-(2-naphthalenyl)phenyl]-	918655-03-5	1%	chemical products
22467	4-Iodo-2,5-dimethoxy-N-[[2-methoxyphenyl]methyl]benzeneethanamine	919797-19-6	1,000ppm	chemical products
22468	2-[(R)-1-Phenylethyl]amino-1-(4-bromophenyl)ethanone hydrochloride	920804-14-4	Contains (regardless of intentional or impurities)	chemical products
22469	Tin titanium zinc oxide	923954-49-8	Contains (regardless of intentional or impurities)	chemical products
22470	Bis(tert-butylimido)bis(dimethylamido)molybdenum	923956-62-1	1,000ppm	chemical products
22471	1,3,5-Triazine-2,4,6-(1H,3H,5H)-trione, 1-[2,3-bis(1-oxopropyl)propyl]-3,5-bis(2-oxiranylmethyl)-	926037-40-3	Contains (regardless of intentional or impurities)	chemical products
22472	1,3,5-Triazine-2,4,6-(1H,3H,5H)-trione, 1,3-bis[2,3-bis(1-oxopropoxy)propyl]-5-(2-oxiranylmethyl)-	926037-41-4	Contains (regardless of intentional or impurities)	chemical products
22473	6-Benzoyloxypyridine-3-boronic acid	929250-35-1	1%	chemical products
22474	Cuprate(4-), [16-[[[18-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-2-sulfonyl]amino]sulfonyl]-29H,31H-phthalocyanine-2,9,23-trisulfonato(6-)-kappa N29,kappa N30,kappa N31,kappa N32]-, hydrogen (1,4), (SP-4-2)	929689-97-4	Intentional addition / 1,000ppm	chemical products
22475	Cuprate(4-), [16-[[[16-[[4-amino-6-chloro-1,3,5-triazin-2-yl]amino]-2-sulfonyl]amino]sulfonyl]-29H,31H-phthalocyanine-2,9,23-trisulfonato(6-)-kappa N29,kappa N30,kappa N31,kappa N32]-	929805-29-8	Intentional addition / 1,000ppm	chemical products
22476	Silica gel, reaction products with chromium oxide (CrO3) and ethoxydiethylaluminum	932384-12-8	1,000ppm	chemical products
22477	6-(Pyrrolidin-1-yl)pyridine-3-boronic acid, pinacol ester	933986-97-1	1%	chemical products
22478	2,4-Dimethoxyimidazole-5-boronic acid pinacol ester	936250-17-8	1%	chemical products
22479	3-Methyl-1H-pyrazole-4-boronic acid pinacol ester	936250-20-3	1%	chemical products
22480	2-(4-tert-Butoxycarbonylpiperazin-1-yl)pyridine-4-boronic acid, pinacol ester	936250-21-4	1%	chemical products
22481	2-Amino-pyrimidinyl-5-boronic acid	936250-22-5	1%	chemical products
22482	4-(Hydroxyphenyl)methyl(1-naphthylmethyl)sulfonium tetrakis(pentafluorophenyl) boranuide	938451-30-0	Contains (regardless of intentional or impurities)	chemical products
22483	Cuprate(4-), [2-[[[3-[[4-chloro-6-ethyl[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa O)-5-sulfonyl]azo-kappa N2]phenylmethyl]azo-kappa N1]-4-sulfobenzato(6-)-kappa O]-sodium (1,4), (SP-4-3)	941301-08-2	Intentional addition / 1,000ppm	chemical products
22484	(eta-5-2,4-Cyclopentadien-1-yl)tris(N-methylmethanaminato)hafnium	941596-80-1	1%	chemical products
22485	1-(S-Cyclopropylsulfonimidoyl)-4-nitrobenzene	942410-33-5	Contains (regardless of intentional or impurities)	chemical products
22486	4-Chloro-2-fluoro-3-methoxyphenylboronic acid	944129-07-1	1%	chemical products
22487	Tetrasodium 1,8,15,22-tetra-(3-sulfoxypropyl)sulfonyl]copper phthalocyanine	944730-39-6	Intentional addition / 1,000ppm	chemical products
22488	4-Cyclopentylbenzeneboronic acid	945837-57-0	1%	chemical products
22489	4-(Cyanomethoxy)phenylboronic acid	947533-23-5	1%	chemical products
22490	2-Amino-5-methylbenzeneboronic acid, pinacol ester	948592-80-1	1%	chemical products
22491	Boronic acid, B-[4-(1-phenyl-1H-benzimidazol-2-yl)phenyl]-	952514-79-3	1%	chemical products
22492	(2R,3R,4S,6R)-2-[[[3a,4R,7S,9R,10R,11R,13R,15R,15aR)-1-(4-Azidobutyl)-4-ethyl-7-fluoro-11-methoxy-3a,7,9,11,13,15-hexamethyl-2,6,8,14-tetraoxotetradecahydro-2H-oxacotetradecyno[4,3-d][1,3]oxazol-10-yl]oxy]-4-(dimethylamino)-6-methylxan-3-yl benzoate	955377-54-5	Contains (regardless of intentional or impurities)	chemical products
22493	4-(N,N-Dimethylsulphamoyl)-2-methylbenzeneboronic acid	957034-82-1	1%	chemical products
22494	4-[[2-(Piperidin-1-yl)ethyl]carbamoyl]benzeneboronic acid hydrochloride	957060-72-9	1%	chemical products
22495	2-Fluoro-4-(methylsulphonyl)benzeneboronic acid	957060-85-4	1%	chemical products
22496	2-(2,2,2-Trifluoroethoxy)benzeneboronic acid	957060-90-1	1%	chemical products
22497	7-Methylimidazo[1,2-a]pyridine-6-boronic acid	957062-57-6	1%	chemical products
22498	2-Methyl-5-nitrophenylboronic acid pinacol ester	957062-84-9	1%	chemical products
22499	4-(2-Methoxy-2-oxoethoxy)benzeneboronic acid	957063-00-2	1%	chemical products
22500	2-Chloro-4-methoxy-5-(methoxycarbonyl)benzeneboronic acid	957066-07-8	1%	chemical products
22501	6-Chloro-1-methyl-1H-indole-2-boronic acid	957066-11-4	1%	chemical products
22502	5-Fluoro-2-methoxypyridine-3-boronic acid	957120-32-0	1%	chemical products
22503	3-Cyano-2-fluorobenzeneboronic acid	957121-05-0	1%	chemical products
22504	2-(1-Piperazinyl)pyridine-4-boronic acid pinacol ester	957198-31-1	1%	chemical products
22505	2,2,4,5-Tetrabromobiphenyl	958802-46-5	Intentional addition / 1,000ppm	chemical products
22506	1,1,2,2,3,3-Hexabromo-1-fluoropropane	958811-66-0	Intentional addition / 1,000ppm	chemical products
22507	1,1,2,3,3-Pentabromo-1,2-difluoropropane	958823-07-9	Intentional addition	chemical products
22508	2-Bromo-5-fluorobenzeneboronic acid	959996-48-6	1%	chemical products
22509	Zirconium, dimethyl[[2,2'-[1,3-propanediyl]bis(oxy-kappa O)]bis[3',5'-tris(1,1-dimethylethyl)-5'-methyl[1,1',3',1'-terphenyl]-2-olato-kappa O]](2-)]-, (OC-6-33)-	1001417-33-9	Contains (regardless of intentional or impurities)	chemical products



#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
22510	Barium europium strontium silicate ((Ba,Eu,Sr)2(SiO4))	1003049-92-0	Intentional addition	chemical products
22511	3-Chloro-4-hydroxy-5-methoxyphenylboronic acid, pinacol ester	1003298-84-7	1%	chemical products
22512	Molybdenum, borate neodecanoate oxo complexes	1003300-72-8	1%	chemical products
22513	2-Chloropyrimidine-5-boronic acid, pinacol ester	1003845-08-6	1%	chemical products
22514	Oxirane, 2-(3,4-difluorophenyl)-, (2S)-	1006376-63-1	1%	chemical products
22515	2-Butanone, 4-chloro-1-(2,3-difluorophenyl)-	1006429-97-5	1%	chemical products
22516	Copper, phthalic anhydride-2,3-pyridinedicarboxylic acid-urea reaction products complexes, aminosulfonyl sulfo[[2-[[4-[[2-sulfoethyl]amino]-6-[[4-sulfoethyl]amino]-1,3,5-triazin-2-yl]amino]ethyl]amino]sulfonyl derivatives, sodium salts	1007578-75-7	Intentional addition / 1,000ppm	chemical products
22517	2-Iodophenylboronic acid	1009106-06-2	1%	chemical products
22518	6-(6-Phenyl-4-dibenzofuranyl)boronic acid	1010068-85-5	1%	chemical products
22519	3,6-Bis(4-chlorophenyl)-1,4-dioxo-1,2,4,5-tetrahydropyrido[3,4-c]pyrrole-2-sulfonic acid	1012067-82-1	Contains (regardless of intentional or impurities)	chemical products
22520	2-Methylpyridine-3-boronic acid, pinacol ester	1012084-56-8	1%	chemical products
22521	Ethanol, 2,2'-(9-octadecenylnitro)bis-, reaction products with ammonium molybdenum oxide and polyethylene glycol ether, with 2,2'-(9-octadecenylnitro)bis[ethanol] (2:1)	1017237-79-4	1%	chemical products
22522	Boron, trifluoro[1-(methoxy-kappa O)-2-methoxyethane]-, (T-4)-	1020537-36-3	1%	chemical products
22523	beta-Alanine, N-[4-[[2-(2-cyano-4-nitrophenyl)diazenyl]phenyl]-N-(phenylmethyl)-, 2-oxopropyl ester	1021394-33-1	Contains (regardless of intentional or impurities)	chemical products
22524	Nickel, [[1-[2,5-bis(3-methylbutoxy)phenyl]-2-phenyl-1,2-ethenedithiolato(2-)-kappa S1,kappa S2][1,2-bis[[1-methylthio]-1,2-ethenedithiolato(2-)-kappa S1,kappa S2]-, (SP-4-3)-]	1021552-48-6	Contains (regardless of intentional or impurities)	chemical products
22525	Nickelate(6-), bis(mu-[[5-[[2-[2-(hydroxy-kappa O)-3,7-disulfo-1-naphthalenyl]diazenyl-kappa N2]-1H-1,2,4-triazole-3-carboxylato(5-)-kappa N1:kappa N2]]di-, hydrogen (1:6)	1023309-94-5	Contains (regardless of intentional or impurities)	chemical products
22526	4-(tert-Butoxymethyl)benzeneboronic acid	1024017-53-5	1%	chemical products
22527	1-Methyl-3-(trifluoromethyl)-1H-pyrazole-5-boronic acid pinacol ester	1025719-23-6	1%	chemical products
22528	Cuprate(4-), [[2-[[4-chloro-6-[ethyl[3-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-5-(hydroxy-kappa O)-6-[2-[2-[2-(hydroxy-kappa O)-5-sulfoethyl]diazenyl-kappa N1]-4,5-dimethoxyphenyl]diazenyl-kappa N2]-1,7-naphthalenedisulfonato(6-)-], hydrogen (1:4)	1026175-06-3	Intentional addition / 1,000ppm	chemical products
22529	Boron, trifluoro(tetrahydrofuran)-, (T-4)-, polymer with 3-methyl-3-[[2,2,3,3,3-pentafluoropropoxy)methyl]oxetane, ether with 2,2-dimethyl-1,3-propanediol (2:1), polymer with alpha-hydro-omega-hydroxypoly(oxy-1,2-ethanediyl) and 5-isocyanato-1-(isocyanatomethyl)-1,3,3-trimethylcyclohexane	1029089-63-1	1%	chemical products
22530	Chromium, 1-[2-(5-(1,1-dimethylpropyl)-2-hydroxy-3-nitrophenyl]diazenyl]-2-naphthalenol 1-[2-[2-hydroxy-4(or 5)-nitrophenyl]diazenyl]-2-naphthalenol ammonium sodium complexes	1029600-34-7	1,000ppm	chemical products
22531	2-Amino-3-nitropyridine-5-boronic acid pinacol ester	1032758-80-7	1%	chemical products
22532	2-(Dimethylamino)pyrimidine-5-boronic acid, pinacol ester	1032759-30-0	1%	chemical products
22533	Nickelate(4-), bis [[4,5-dicyano-1H-imidazol-2-yl, kappa N1] azo-kappa N1]-6-(hydroxy-kappa O)-2-naphthalenesulfonato(3-)-], tetrasodium	1035211-50-7	Contains (regardless of intentional or impurities)	chemical products
22534	2-(4-Iodo-2,5-dimethoxyphenyl)-N-(2-methoxybenzyl)ethanamine hydrochloride (1:1)	1043868-97-8	1,000ppm	chemical products
22535	Nickelate(1-), [[3-[[2-[hexahydro-2,4-dioxo-6-(oxo-kappa O)-5-pyrimidinyl]diazenyl-kappa N1]-4-(hydroxy-kappa O)benzenesulfonato(3-)-], hydrogen (1:1)]	1047996-27-9	Contains (regardless of intentional or impurities)	chemical products
22536	Borate(1-), tetrahydro-, sodium (1:1), reaction products with reduced polymerized oxidized tetrafluoroethylene, hydrolyzed, diallyl ethers, polymers with 3-[[dimethylsilyloxy]-1,1,3,5,5-pentamethyl-1-[2-(trimethoxysilyl)ethyl]trisiloxane	1072943-15-7	1%	chemical products
22537	6-Fluoro-4-methylpyridine-3-boronic acid	1072944-18-3	1%	chemical products
22538	3-[4-Methoxybenzoyloxy]phenylboronic acid	1072951-89-3	1%	chemical products
22539	2-Fluoro-5-(hydroxymethyl)benzeneboronic acid	1072952-25-0	1%	chemical products
22540	3,5-Dimethyl-1H-pyrazole-4-boronic acid, pinacol ester, N1-BOC protected	1073254-70-7	1%	chemical products
22541	3-Fluoro-4-(N-morpholinomethyl)phenylboronic acid, pinacol ester	1073354-74-1	1%	chemical products
22542	1,3-Benzoxadiazole-5-boronic acid, pinacol ester	1073355-14-2	1%	chemical products
22543	5-Hydroxy-4-(methoxycarbonyl)phenylboronic acid pinacol ester	1073371-99-9	1%	chemical products
22544	2-(Chloromethyl)-3,4-difluoro-1-methoxybenzene	1073435-67-2	1%	chemical products
22545	1,2-Difluoro-3-[[4-fluoro-2-methoxy-5-nitrophenyl]methyl]-4-methoxybenzene	1073435-71-8	1%	chemical products
22546	Cuprate(3-), [[3-[[2-[5-(hydroxy-kappa O)-4-[2-[1-(hydroxy-kappa O)-6-(phenylamino)-3-sulfo-2-naphthalenyl]diazenyl-kappa N1]-2-methylphenyl]diazenyl]-1,5-naphthalenedisulfonato(5-)-], hydrogen, compound with 2,2'-iminobis[ethanol] (1:3:3)]	1078726-27-8	Contains (regardless of intentional or impurities)	chemical products
22547	Cuprate(3-), [[3-[[2-[5-(hydroxy-kappa O)-4-[2-[1-(hydroxy-kappa O)-6-(phenylamino)-3-sulfo-2-naphthalenyl]diazenyl-kappa N1]-2-methylphenyl]diazenyl]-1,5-naphthalenedisulfonato(5-)-], ammonium (1:3)]	1078726-28-9	Contains (regardless of intentional or impurities)	chemical products
22548	Cuprate(4-), [[2-[[2-[2-[3-[[4-chloro-6-[ethyl[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa O)-5-sulfoethyl]diazenyl-kappa N1]phenylmethyl]diazenyl-kappa N1]-4-sulfobenzoato(6-)-kappa O]-, sodium hydrogen (1:3:1)]	1079350-81-4	Intentional addition / 1,000ppm	chemical products
22549	Cuprate(4-), [[2-[[2-[2-[3-[[4-chloro-6-[ethyl[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-2-(hydroxy-kappa O)-5-sulfoethyl]diazenyl-kappa N1]phenylmethyl]diazenyl-kappa N1]-4-sulfobenzoato(6-)-kappa O]-]	1079440-35-9	Intentional addition / 1,000ppm	chemical products
22550	2-(Trifluoromethyl)pyridine-4-boronic acid	1093407-58-9	1%	chemical products
22551	Boron, [N-(carboxy-kappa O)methyl]-N-methylglycinate(2-)-, kappa N,kappa O)methyl-, (T-4)-	1104637-40-2	1%	chemical products
22552	4,4'-Bis[sec-alkyl(C10-13)phenyl]iodonium tetrakis(pentafluorophenyl)borate	1115251-57-4	1%	chemical products
22553	[(1S)-3-Methyl-1-[[[2S]-1-oxo-3-phenyl-2-[[pyrazinyl(carbonyl)amino]propyl]amino]butyl]boronic acid	1132709-14-8	1%	chemical products
22554	[(1R)-3-Methyl-1-[[[2R]-1-oxo-3-phenyl-2-[[pyrazinyl(carbonyl)amino]propyl]amino]butyl]boronic acid	1132709-15-9	1%	chemical products
22555	[(1S)-3-Methyl-1-[[[2R]-1-oxo-3-phenyl-2-[[pyrazinyl(carbonyl)amino]propyl]amino]butyl]boronic acid	1132709-16-0	1%	chemical products
22556	Propanoic acid, 3-chloro-, 5-hydroxypentyl ester	1134944-74-3	1%	chemical products
22557	Quaternary ammonium compounds, coco alkylbis(hydroxyethyl)methyl, ethoxylated, [29H,31H-phthalocyanine-C-C-disulfonato(4-)-kappa N29,kappa N30,kappa N31,kappa N32]cuprate(2-)(2:1)	1140527-05-4	Intentional addition / 1,000ppm	chemical products
22558	2,2,6,6-Tetramethyl-3,6-dihydro-2H-pyran-4-boronic acid pinacol ester	1142363-56-1	1%	chemical products
22559	Heptanoic acid, 2,2,3,3,4,4,5,5,6,6,7,7,7-dodecafluoro-4-(trifluoromethyl)-	1144512-18-4	1,000ppm	chemical products
22560	Hexanoic acid, 2,2,3,3,4,4,5,5,6,6,6-nonafluoro-5-bis(trifluoromethyl)-	1144512-34-4	1,000ppm	chemical products
22561	Hexanoic acid, 2,2,3,3,4,4,5,5,6,6,6-nonafluoro-3,5-bis(trifluoromethyl)-	1144512-35-5	1,000ppm	chemical products
22562	Hexanoic acid, 2,2,3,3,4,4,5,5,6,6,6-nonafluoro-4,5-bis(trifluoromethyl)-	1144512-36-6	1,000ppm	chemical products
22563	(2R,3R,4S,6R)-2-[[[3aS,4R,7R,8S,9S,10R,11R,13R,15R,15aR)-1-(4-Azidobutyl)-4-ethyl-8-hydroxy-11-methoxy-3a,7,9,11,13,15-hexamethyl-2,6,8,14-trioxatetradecahydro-2H-oxacyclotetradecyno[4,3-d][1,3]oxazol-10-yl]oxy]-4-(dimethylamino)-6-methylxan-3-yl benzoate	1145656-96-7	Contains (regardless of intentional or impurities)	chemical products
22564	(2R,3R,4S,6R)-2-[[[3aS,4R,7R,8R,10R,11R,13R,15R,15aR)-1-(4-Azidobutyl)-4-ethyl-8-hydroxy-11-methoxy-3a,7,9,11,13,15-hexamethyl-2,6,8,14-tetraoxatetradecahydro-2H-oxacyclotetradecyno[4,3-d][1,3]oxazol-10-yl]oxy]-4-(dimethylamino)-6-methylxan-3-yl benzoate	1145656-98-9	Contains (regardless of intentional or impurities)	chemical products
22565	4-Cyano-2-fluorobenzeneboronic acid	1150114-77-4	1%	chemical products
22566	1-Methyl-1H-imidazole-6-boronic acid	1150114-80-9	1%	chemical products
22567	Bis(4-isopropoxyphenyl)iodonium tetraphenylboron	1158840-74-4	Contains (regardless of intentional or impurities)	chemical products
22568	Dimethyl 4-(methoxycarbonyl)-2-nitrophenylmalonate	1160293-27-5	Contains (regardless of intentional or impurities)	chemical products
22569	3-Chloro-5-(trifluoromethyl)phenylboronic acid	1160561-31-8	1%	chemical products
22570	4-Chlor-2-fluorobiphenyl-4-boronic acid	1161937-32-1	1%	chemical products
22571	1-(3-Bromo-2-fluorophenyl)-2-chloroethanone	1164294-23-8	1%	chemical products
22572	Quinoxaline-6-boronic acid pinacol ester	1167418-13-4	1%	chemical products
22573	HeIQ AGS-20	1167997-68-3	Intentional addition / 100ppm	chemical products
22574	Benzo[c][1,2,5]thiadiazole-5-boronic acid pinacol ester	1168135-03-2	1%	chemical products
22575	Cuprate(1-), [[4-(29H,31H-phthalocyanin-C-yl-kappa N29,kappa N30,kappa N31,kappa N32)benzenesulfonato(3-)-], sodium (1:1)]	1169940-97-9	Intentional addition / 1,000ppm	chemical products
22576	Cyclohexanon-1,4-dicarboxylic acid hydrogen ethoxymethyl	1173478-74-4	Contains (regardless of intentional or impurities)	chemical products
22577	Boronic acid, B-[4-(1,2,2,2-tetrafluoro-1-(trifluoromethyl)ethyl]phenyl]-	1184850-50-7	1%	chemical products
22578	Cyclohexanon-1,4-dicarboxylic acid bis(ethoxymethyl)	1187579-75-4	Contains (regardless of intentional or impurities)	chemical products
22579	Hexanoic acid, 2,2,3,3,5,5,6,6,6-nonafluoro-4-bis(trifluoromethyl)-	1192593-79-5	1,000ppm	chemical products
22580	Hexanoic acid, 2,3,3,4,4,5,5,6,6,6-decafluoro-2-(1,1,2,2,2-pentafluoroethyl)-, sodium salt (1:1)	1195164-59-0	1,000ppm	chemical products
22581	2-Aminopyridine-4-boronic acid pinacol ester	1195995-72-2	1%	chemical products
22582	Potassium salts and sodium salts of reaction product of 2-amino-6-[2-(hydroxysulfonyloxy)ethyl]sulfonylnaphthalene-1-sulfonate/4-amino-5-hydroxynaphthalene-2,7-disulfonate/2,4,6-trichloro-1,3,5-triazine/sulfuric acid hydrogen 2-[3-(ethylamino)phenylsulfonyl]ethyl ester	1198077-78-9	Contains (regardless of intentional or impurities)	chemical products
22583	Zinc calcium europium strontium zinc silicate (BaO-2CaO-1EuO-0.5SrO-2ZnO-1(SiO4))	1198427-29-0	Intentional addition	chemical products
22584	Nickelate(6-), bis(mu-[[5-[[2-[3,6-bis[[4-carboxyphenyl]amino]sulfonyl]-2-(hydroxy-kappa O)-1-naphthalenyl]diazenyl-kappa N2]-1H-1,2,4-triazole-3-carboxylato(5-)-kappa N1:kappa N2]]di-, sodium hydrogen	1200116-89-7	Contains (regardless of intentional or impurities)	chemical products
22585	Reaction product of (reaction product of 2,2'-oxydiethanol and 1-chloro-2,3-epoxypropane) and 2-hydroxythioxanthene-9-one	1202056-62-9	Contains (regardless of intentional or impurities)	chemical products
22586	N-(4-Methoxybutyl)benzene-1,2-diamine	1202261-23-1	Contains (regardless of intentional or impurities)	chemical products
22587	Tris[4-[[4-acetylphenyl]thio]phenyl]sulfonium tetrakis(2,3,4,5,6-pentafluorophenyl) boron anion salt	1203809-92-0	1%	chemical products
22588	5-(Methylsulfonyl)pyridine-3-boronic acid pinacol ester	1206641-26-0	1%	chemical products
22589	6-(4-Aminophenoxy)-[1,1'-biphenyl]-3-amine	1215223-23-6	Contains (regardless of intentional or impurities)	chemical products
22590	2,3-Pyridinediamine, N2,N2-diethyl-6-methyl-	1215952-41-2	1%	chemical products
22591	2,2-Dibromo-1-(2-fluorophenyl)ethanone	1224739-02-9	1%	chemical products
22592	Hexanoic acid, 3,5,5-trimethyl-, tin(2+) salt (2:1)	1231728-34-9	Contains (regardless of intentional or impurities)	chemical products
22593	Barium europium nitrogen silicon oxide	1233976-62-9	Intentional addition	chemical products
22594	Glycine, N-(5-(acetylamino)-2-methoxy-4-(2-(5-nitro-2,1-benzisothiazol-3-yl)diazenyl]phenyl)-N-(2-methoxy-2-oxoethyl)-, methyl ester	1235882-84-4	Contains (regardless of intentional or impurities)	chemical products
22595	Indium manganese yttrium oxide	1239902-45-4	1%	chemical products
22596	Barium europium nitrogen silicon strontium chloride oxide	1246288-04-3	Intentional addition	chemical products
22597	Boron, [(7R)-7-[[[1,2-(3,5-dimethyl-1H-pyrryl-2-yl-kappa N)-12-(3,5-dimethyl-2H-pyrryl-2-ylidene-kappa N)-1-oxododecyl]oxy]-4-hydroxy-N,N,N-trimethyl-10-oxo-3,5,9-trioxo-4-phosphapentacosan-1-amium-4-oxido(2-)]difluoro-, (T-4)-	1246355-63-4	1%	chemical products
22598	Cuprate(2-), [[2-[[2-[1-(hydroxy-kappa O)-6-(phenylamino)-3-sulfo-2-naphthalenyl]diazenyl-kappa N1]-5-[2-(4-sulfoethyl]diazenyl]benzoato(4-)-kappa O]-, hydrogen (1:2)]	1246457-56-6	Intentional addition / 1,000ppm	chemical products
22599	Cuprate(2-), [[2-[[2-[1-(hydroxy-kappa O)-6-(phenylamino)-3-sulfo-2-naphthalenyl]diazenyl-kappa N1]-5-[2-(4-sulfoethyl]diazenyl]benzoato(4-)-kappa O]-, sodium (1:2)]	1246457-57-7	Intentional addition / 1,000ppm	chemical products
22600	Cuprate(6-), [[N,N-1,2-ethanedithiolate(2-)-[2-[[2,7-dihydro-3-methyl-2,7-dioxo-1-(3-sulfobenzoyl)-3H-naphtho[1,2,3-de]quinolin-6-yl]amino]-2,4-disulfoethyl]amino]-2-oxoethyl]glycinate-kappa N,kappa O]](8-)-], potassium salt	1247867-76-0	Intentional addition / 1,000ppm	chemical products
22601	4-(2-Methoxy-1-methylethoxy)-2-methylbenzoyl chloride	1253521-36-6	Contains (regardless of intentional or impurities)	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
22602	Cuprate(4-), [mu]-[[3,3'-[3,3'-di(hydroxy-kappa O)[1,1'-biphenyl]-4,4'-diyl]bis(2,1-diazenediyl-kappa N1)]bis[5-amino-4-(hydroxy-kappa O)-2,7-naphthalenedisulfonato]](8-)]disodium hydrogen (1:2:2)	1254333-41-9	Intentional addition / 1,000ppm	chemical products
22603	Cuprate(7-), [N-[[2-[[[carboxy-kappa O)methyl]carboxymethyl]amino-kappa N]ethyl]-N-[2-[3-[[4-[[5-[[2,7-dihydro-3-methyl-2,7-dioxo-1-(3-sulfonylbenzoyl)-3H-naphtho[1,2,3-de]quinolin-6-yl]amino]-2,4-disulfonyl]amino]-6-[[2-[[4-[[5-[[2,7-dihydro-3-methyl-2,7-dioxo-1-(3-sulfonylbenzoyl)-3H-naphtho[1,2,3-de]quinolin-6-yl]amino]-2,4-disulfonyl]amino]-6-methoxy-1,3,5-triazin-2-yl]amino]ethyl]amino]-1,3,5-triazin-2-yl]oxy]phenyl]amino]-2-oxoethyl]glycinate(9-)-kappa N.kappa O]-, potassium sodium salt	1254513-17-1	Intentional addition / 1,000ppm	chemical products
22604	Copper(II) bis(3-cyano-4-(2-[4-(octadecyloxy)phenyl]ethoxy)-4-oxobut-2-en-2-olate)	1256282-29-7	Intentional addition / 1,000ppm	chemical products
22605	3-Dimethylamino)phenylboronic acid hydrochloride	1256355-23-3	1%	chemical products
22606	4-Amino-3-fluorophenylboronic acid hydrochloride	1256355-32-4	1%	chemical products
22607	5-(N-BOC-Aminomethyl)pyridine-3-boronic acid pinacol ester	1257554-93-0	1%	chemical products
22608	(2R)-2-[[2-Nitrophenyl]sulfonyl]amino]propyl methanesulfonate	1258834-14-8	Contains (regardless of intentional or impurities)	chemical products
22609	2-(Chloromethyl)-3-iodotoluene	1261500-86-0	Contains (regardless of intentional or impurities)	chemical products
22610	Acetic acid, 2,2-dioxo-1,2-lambda.6-oxathiolan-4-yl ester	1263199-75-2	Contains (regardless of intentional or impurities)	chemical products
22611	Barium europium strontium chloride phosphate	1273005-45-0	Intentional addition	chemical products
22612	Naphtho[2,1-b]furan-1(2H)-one, 2-methyl-	1293918-76-9	1%	chemical products
22613	Reaction product of 3-[[3-amino-2-(olato-kappa O)-5-sulfonyl]diazeny]phenyl)methyl]diazeny]-4-(carboxylate-kappa O)benzenesulfonic acid copper(II) or its mono- (or di-) sodium salt (mixture), 2,5-diaminobenzenesulfonic acid, 2,4,6-trichloro-1,3,5-triazine, and morpholine, mainly consisting of 3,3'-((2-sulfo-1,4-phenylene)bis[imino(6-morpholino-1,3,5-triazine-4,2-diyl)imino(2-(olato-kappa O)-5-sulfo-3,1-phenylene)]diazeny]di(phenyl)methyl)ethy]diazeny]bis[4-(carboxylate-kappa O)benzenesulfonic acid copper(II)]	1313741-22-8	Intentional addition / 1,000ppm	chemical products
22614	6-Amino-2-anilino-4-methyl-5-[[4-nitro-2-(trifluoromethyl)phenyl]diazeny]nicotinonitrile	1313823-87-8	Contains (regardless of intentional or impurities)	chemical products
22615	2-Amino-6-anilino-4-methyl-5-[[4-nitro-2-(trifluoromethyl)phenyl]diazeny]nicotinonitrile	1313823-90-3	Contains (regardless of intentional or impurities)	chemical products
22616	2-Methyl-1H-benzimidazole-5-boronic acid pinacol ester	1314216-34-6	1%	chemical products
22617	N-(4-Phenylphenyl)benzofuran-4-amine	1318338-47-4	1%	chemical products
22618	Ethanesulfonic acid prop-2-yn-1-yl ester	1326236-05-8	Contains (regardless of intentional or impurities)	chemical products
22619	Cuprate(3-), [3-[2-[3-(hydroxy-kappa O)-4-[2-[1-(hydroxy-kappa O)-6-(phenylamino)-3-sulfo-2-naphthaleny]diazeny]-kappa N1]phenyl]diazeny]-1,5-naphthalenedisulfonato(5-)]-, compounds with diethanolamine and 2-(methylamino)ethanol	1335122-97-8	Intentional addition / 1,000ppm	chemical products
22620	Cuprate(1-), [29H,31H-phthalocyanine-C-sulfonato(3-)-kappa N29.kappa N30.kappa N31.kappa N32]-hydrogen (1:1), compounds with polypropylene glycol 2-aminomethyl ethyl branched nonylphenyl ether	1351192-50-1	Intentional addition / 1,000ppm	chemical products
22621	Cuprate(2-), [29H,31H-phthalocyanine-C-O-disulfonato(4-)-kappa N29.kappa N30.kappa N31.kappa N32]-hydrogen (1:2), compounds with polypropylene glycol 2-aminomethyl ethyl branched nonylphenyl ether (1:2)	1351192-51-2	Intentional addition / 1,000ppm	chemical products
22622	Cuprate(3-), [29H,31H-phthalocyanine-C-C-trisulfonato(5-)-kappa N29.kappa N30.kappa N31.kappa N32]-hydrogen (1:3), compounds with polypropylene glycol 2-aminomethyl ethyl branched nonylphenyl ether (1:3)	1351192-52-3	Intentional addition / 1,000ppm	chemical products
22623	3-(Difluoromethyl)-1-methyl-N-[[3(R)-1,1,3-trimethylindan-4-yl]-1H-pyrazole-4-carboxamide	1352994-67-2	Intentional addition	chemical products
22624	Copolymer of 2-hydroxyethyl acrylate/butyl acrylate/(phenol/formaldehyde condensate, etherified by 1-chloro-2,3-epoxypropane)/methacrylic acid/alpha-methyl-omega-methoxypropyl[oxyl(dimethylsilyl)ane diyl]oxy[methoxy(phenyl)silamethyl]	1361959-78-5	Contains (regardless of intentional or impurities)	chemical products
22625	Iodonium diphenyl-, 4,4'-di-O-10-13-alkyl derivatives, hexafluoroantimonates(1-)	1370442-66-2	Contains (regardless of intentional or impurities)	chemical products
22626	(2,2-Dioxo-1,3,2-lambda.6-dioxathiolan-4-yl)methyl methanesulfonate	1373610-00-4	Contains (regardless of intentional or impurities)	chemical products
22627	Niobium sulfur tin zinc oxide	1374645-21-2	Contains (regardless of intentional or impurities)	chemical products
22628	Copolymer of butyl acrylate/(phenol/formaldehyde condensate, etherified by 1-chloro-2,3-epoxypropane)/methacrylic acid/2,3-epoxypropyl methacrylate	1380486-33-8	Contains (regardless of intentional or impurities)	chemical products
22629	1,1,1-Tribromo-3,3,3-trifluoroisopropane	1393524-84-9	Intentional addition	chemical products
22630	4-Cyclopropylisouquinoline-3-amine	1400701-71-4	Contains (regardless of intentional or impurities)	chemical products
22631	Boronic acid, B-[3,5-bis[1,2,2,2-tetrafluoro-1-(trifluoromethyl)ethyl]phenyl]-	1402929-36-5	Intentional addition / 1%	chemical products
22632	N-(1,3-Benzothiazol-2-yl)-N-hexylhydrazine	1404197-89-2	Contains (regardless of intentional or impurities)	chemical products
22633	Barium strontium silicate	1415232-60-8	Intentional addition	chemical products
22634	Barium carbon europium magnesium nitrogen silicon strontium oxide	1431849-80-7	Intentional addition	chemical products
22635	Cuprate(4-), [5-[[4-chloro-6-[[4-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-4-(hydroxy-kappa O)-3-[2-[2-(hydroxy-kappa O)-4-sulfo-1-naphthaleny]diazeny]-kappa N1]-2,7-naphthalenedisulfonato(6-)]-, sodium (1:4)	1435135-35-5	Intentional addition / 1,000ppm	chemical products
22636	(4-Methoxybenzyl)dimethyl(phenyl)ammonium trifluoromethanesulfonate	1448671-27-9	Intentional addition / 1%	chemical products
22637	C14-18 alpha-Olefin epoxide, reaction products with boric acid	1471314-23-4	Intentional addition / 1%	chemical products
22638	Tris(1,3-dihydroxyprop-2-yl) borate	1472633-72-9	Intentional addition / 1%	chemical products
22639	Barium bis(d-C8-10, branched, C9 rich, alkyl)naphthalenesulfonate	1474044-80-8	Intentional addition	chemical products
22640	Cuprate(4-), [2-[[4-chloro-6-[ethyl]3-[[2-(sulfoxy)ethyl]sulfonyl]phenyl]amino]-1,3,5-triazin-2-yl]amino]-5-(hydroxy-kappa O)-6-[2-[2-[2-(hydroxy-kappa O)-5-sulfonyl]diazeny]-kappa N1]-4,5-dimethoxyphenyl]diazeny]-kappa N2]-1,7-naphthalenedisulfonato(6-)]-, hydrogen sodium (1:2:2)	1512859-54-9	Intentional addition / 1,000ppm	chemical products
22641	1-Chloromethyl-2,5-dichloro-4-ethoxybenzene	1553739-69-7	Intentional addition / 1%	chemical products
22642	(4-Bromomethyl)-2-[4-(difluoromethoxy)-3-isopropoxyphenyl]-1,3-oxazole	1574285-38-3	Contains (regardless of intentional or impurities)	chemical products
22643	3-Pyridinecarbonitrile, 1,2-dihydro-6-hydroxy-1,4-dimethyl-5-[2-[2-nitro-4-(phenylmethoxy)phenyl]diazeny]-2-oxo-	1613451-37-8	Contains (regardless of intentional or impurities)	chemical products
22644	5-Nitro-2-(4,4,4,5,5-tetramethyl-1,3,2-dioxaborolane-2-yl)phenoxy]pyrimidine	1622210-63-2	Contains (regardless of intentional or impurities)	chemical products
22645	Siloxanes and Silicones, 3-[[2-aminoethyl]amino]propyl methyl, dimethyl, reaction products with cadmium zinc selenide sulfide, lauric acid and oleylamine	1623456-05-2	Contains (regardless of intentional or impurities)	chemical products
22646	Boron, [mu]-[alpha.1.alpha.4-bis(2-benzothiazolyl)-kappa N3]-3,6-bis[4-(isocycloxyloxy)phenyl]pyrrolidol[3,4-c]pyrrole-1,4-diacetonitrilo(2-)-kappa N2.kappa N5]]tetra-phenyl]-	1624850-63-0	Intentional addition / 1%	chemical products
22647	4-(4-tert-Butylphenyl)-1,4-oxathiane-4-ium methylsulfate	1627528-06-6	Contains (regardless of intentional or impurities)	chemical products
22648	Cuprate(4-), [mu]-[[3,3'-[[1-oxido-1,2-diazenediyl]bis[2-(hydroxy-kappa O)-4-1-phenylene]-2,1-diazenediyl-kappa N1]]bis[4-(hydroxy-kappa O)-2,7-naphthalenedisulfonato]](8-)]di-, ammonium sodium	1713250-52-2	Intentional addition / 1,000ppm	chemical products
22649	Tin titanium tungsten zinc oxide	1800376-54-8	Contains (regardless of intentional or impurities)	chemical products
22650	Phenol, 3-dodecyl-, branched	1801269-77-1	Contains (regardless of intentional or impurities)	chemical products
22651	Phenol, 2-dodecyl-, branched	1801269-80-6	Contains (regardless of intentional or impurities)	chemical products
22652	Poly[iminocarbonimidoyl]iminocarbonimidoyl]imino-1,6-hexanediy]-, hydrochloride	1802181-67-4	Intentional addition / 100ppm	chemical products
22653	Hexanoic acid, 3,3,4,4,5,5,6,6,6-nonafluoro-2,2-bis(trifluoromethyl)-	1812247-17-8	Intentional addition / 1,000ppm	chemical products
22654	Hexanoic acid, 2,3,4,4,5,5,6,6,6-nonafluoro-2,3-bis(trifluoromethyl)-	1812247-18-9	Intentional addition / 1,000ppm	chemical products
22655	Hexanoic acid, 2,3,4,4,5,5,6,6,6-nonafluoro-2,4-bis(trifluoromethyl)-	1812247-19-0	Intentional addition / 1,000ppm	chemical products
22656	Hexanoic acid, 2,2,4,4,5,5,6,6,6-nonafluoro-3,3-bis(trifluoromethyl)-	1812247-20-3	Intentional addition / 1,000ppm	chemical products
22657	Calcium molybdenum neodymium oxide	1814903-27-9	Intentional addition / 1%	chemical products
22658	2,4-Dimethyl-5-(4-nitrophenoxy)pyrimidine	1872428-94-8	Contains (regardless of intentional or impurities)	chemical products
22659	Butanoic acid, 3,3,4,4,4-pentafluoro-2,2-bis(1,1,2,2,2-pentafluoroethyl)-	1882109-58-1	Intentional addition / 1,000ppm	chemical products
22660	Butanoic acid, 3,3,4,4,4-pentafluoro-2-[1,2,2,2-tetrafluoro-1-(trifluoromethyl)ethyl]-2-(trifluoromethyl)-	1882109-59-2	Intentional addition / 1,000ppm	chemical products
22661	Butanoic acid, 2,3,3,4,4,4-hexafluoro-2-[2,2,2-trifluoro-1-bis(trifluoromethyl)ethyl]-	1882109-60-5	Intentional addition / 1,000ppm	chemical products
22662	Butanoic acid, 2,3,4,4,4-pentafluoro-2-[1,2,2,2-tetrafluoro-1-(trifluoromethyl)ethyl]-3-(trifluoromethyl)-	1882109-61-6	Intentional addition / 1,000ppm	chemical products
22663	Butanoic acid, 4,4,4-trifluoro-2,2,3,3-tetrakis(trifluoromethyl)-	1882109-62-7	Intentional addition / 1,000ppm	chemical products
22664	Pentanoic acid, 3,3,4,4,5,5,5-heptafluoro-2-(1,1,2,2,2-pentafluoroethyl)-2-(trifluoromethyl)-	1882109-63-8	Intentional addition / 1,000ppm	chemical products
22665	Pentanoic acid, 2,3,4,4,5,5,5-heptafluoro-2-(1,1,2,2,2-pentafluoroethyl)-3-(trifluoromethyl)-	1882109-64-9	Intentional addition / 1,000ppm	chemical products
22666	Pentanoic acid, 2,3,3,4,4,5,5-heptafluoro-2-(1,1,2,2,2-pentafluoroethyl)-4-(trifluoromethyl)-	1882109-65-0	Intentional addition / 1,000ppm	chemical products
22667	Pentanoic acid, 2,3,4,4,5,5,5-heptafluoro-3-(1,1,2,2,2-pentafluoroethyl)-2-(trifluoromethyl)-	1882109-66-1	Intentional addition / 1,000ppm	chemical products
22668	Pentanoic acid, 2,2,4,4,5,5,5-heptafluoro-3-(1,1,2,2,2-pentafluoroethyl)-3-(trifluoromethyl)-	1882109-67-2	Intentional addition / 1,000ppm	chemical products
22669	Pentanoic acid, 2,2,3,4,4,5,5-heptafluoro-3-(1,1,2,2,2-pentafluoroethyl)-4-(trifluoromethyl)-	1882109-68-3	Intentional addition / 1,000ppm	chemical products
22670	Pentanoic acid, 3,4,4,5,5,5-hexafluoro-2,2,3-tris(trifluoromethyl)-	1882109-69-4	Intentional addition / 100ppm	chemical products
22671	Pentanoic acid, 3,3,4,5,5,5-hexafluoro-2,2,4-tris(trifluoromethyl)-	1882109-70-7	Intentional addition / 1,000ppm	chemical products
22672	Pentanoic acid, 2,4,4,5,5,5-hexafluoro-2,3,3-tris(trifluoromethyl)-	1882109-71-8	Intentional addition / 1,000ppm	chemical products
22673	Pentanoic acid, 2,3,4,5,5,5-hexafluoro-2,3,4-tris(trifluoromethyl)-	1882109-72-9	Intentional addition / 100ppm	chemical products
22674	Pentanoic acid, 2,3,3,5,5,5-hexafluoro-2,4,4-tris(trifluoromethyl)-	1882109-73-0	Intentional addition / 100ppm	chemical products
22675	Pentanoic acid, 2,2,4,5,5,5-hexafluoro-3,3,4-tris(trifluoromethyl)-	1882109-74-1	Intentional addition / 1,000ppm	chemical products
22676	Pentanoic acid, 2,2,3,5,5,5-hexafluoro-3,4,4-tris(trifluoromethyl)-	1882109-75-2	Intentional addition / 100ppm	chemical products
22677	Pentanoic acid, 2,3,3,4,4,5,5-octafluoro-2-[1,2,2,2-tetrafluoro-1-(trifluoromethyl)ethyl]-	1882109-76-3	Intentional addition / 100ppm	chemical products
22678	Pentanoic acid, 2,3,3,4,4,5,5,5-octafluoro-2-(1,1,2,2,3,3,3-heptafluoropropyl)-	1882109-77-4	Intentional addition / 100ppm	chemical products
22679	Hexanoic acid, 2,2,3,4,4,5,5,6,6,6-decafluoro-3-(1,1,2,2,2-pentafluoroethyl)-	1882109-78-5	Intentional addition / 1,000ppm	chemical products
22680	Hexanoic acid, 2,2,3,3,4,4,5,5,6,6,6-decafluoro-4-(1,1,2,2,2-pentafluoroethyl)-	1882109-79-6	Intentional addition / 100ppm	chemical products
22681	Hexanoic acid, 2,3,3,4,4,5,5,6,6,6-nonafluoro-2,5-bis(trifluoromethyl)-	1882109-80-9	Intentional addition / 100ppm	chemical products
22682	Hexanoic acid, 2,2,3,4,4,5,5,6,6,6-nonafluoro-3,4-bis(trifluoromethyl)-	1882109-81-0	Intentional addition / 100ppm	chemical products
22683	Molybdenum(1+), tris(carbamodithioato-kappa S,kappa S')tris(mu,-disulfur-kappa S,kappa S'-kappa S,kappa S')-mu.3-thioxotri-, N,N,N',N',N''-hexacoco alkyl derivatives, salts with N,N-dicococalkylcarbamodithioates (1:1)	1928735-59-4	Intentional addition / 1%	chemical products
22684	3-(Bromomethyl)but-3-en-1-yl propionate	1953139-88-2	Contains (regardless of intentional or impurities)	chemical products
22685	Aluminum boron cobalt lithium magnesium nickel oxide	2087499-33-8	Contains (regardless of intentional or impurities)	chemical products
22686	Cyclopropanecarbonitrile, 1-(4-fluoro-1H-indol-3-yl)-	210917-08-1	Intentional addition / 1%	chemical products
22687	Bromodifluoropropane	MSM20-02-0001	Contains (regardless of intentional or impurities)	chemical products
22688	(1,3-Dioxolo[4,5-f][1,3]benzothiazol-6-yl)ammonium bromide	MSM20-02-0006	100%	chemical products
22689	(1R,2S)-1-[[[2S,4R)-4-(Phenanthridine-6-yloxy)pyrrolidine-2-yl]carboxamido]-2-vinylcyclopropane-1-carboxylic acid ethyl ester	MSM20-02-0007	100%	chemical products
22690	(1R,2S,3R,4S)-7-Oxabicyclo[2,2,1]heptane-2,3-dicarboxylic acid salts	MSM20-02-0008	Intentional addition / 1.5%	chemical products
22691	(2-Amino-3-bromo-5-fluorophenyl)phenylmethane	MSM20-02-0011	100%	chemical products
22692	(2R)-1-Chloro-3-(7-fluoro-4-indanyloxy)-2-propanol and (2S)-1-epoxy-3-(7-fluoro-4-indanyloxy)-2-propane, mixture	MSM20-02-0012	100%	chemical products
22693	(2S)-1-[2-Difluoro-2-(1-hydroxy-3,3,5-tetramethylcyclohexyl)acetyl]pyrrolidine-2-carbaldehyde	MSM20-02-0015	100%	chemical products
22694	(2S)-3-[N-Benzyl-N-[2-(sulfonateoxyethyl)amino]-2-hydroxypropanoate, potassium sodium	MSM20-02-0016	100%	chemical products
22695	(2S)-4-(Chlorocarbonyl)-2-methyl-2,5-dihydropyrrole-1-carboxylic acid allyl ester	MSM20-02-0017	100%	chemical products
22696	(2Z)-2-(5-Amino-1,2,4-thiadiazole-3-yl)-2-(methoxymino)acetyl chloride	MSM20-02-0018	100%	chemical products
22697	(3S)-4-Chloro-3-(oxane-2-yloxy)butyl methanesulfonate	MSM20-02-0020	100%	chemical products
22698	(4E)-Dec-4-enohydrazide	MSM20-02-0023	100%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
22699	(4-Hydroxy-2-methylphenyl)(methyl)(1-naphthylmethyl)sulfonium tetrakis(pentafluorophenyl) boronate salt	MSM20-02-0024	100%	chemical products
22700	(4-Isopropylphenyl)(4-tolyl)iodonium trifluoro[tris(pentafluoroethyl)]-lambda.(5)-phosphanuide	MSM20-02-0025	100%	chemical products
22701	(4R,5S,6S)-6-[[1R]-1-Hydroxyethyl]-4-methyl-3-[[[3S,5S]-1-(4-nitrobenzyloxy)carbonyl]-5-(sulfamoylamino)methyl]pyrrolidine-3-yl]thio]-7-oxo-1-azabicyclo[3.2.0]hepta-2-ene-2-carboxylic acid 4-nitrobenzyl 2-methanol	MSM20-02-0026	100%	chemical products
22702	(5R)-5-(2R)-1,4-Dioxaspiro[4.5]decane-2-yl]-3,4-dihydroxy-2,5-dihydrofuran-2-one	MSM20-02-0027	100%	chemical products
22703	(6R,6S)-3-[[[3S]-1-[4-(p-Nitrobenzyloxy)carbonyl]acetimidoyl]-3-pyrrolidinyl]thio]-7-oxo-6-[[R]-1-(trimethylsilyloxy)ethyl]-1-azabicyclo[3.2.0]hepta-2-ene-2-carboxylic acid p-nitrobenzyl ester	MSM20-02-0028	100%	chemical products
22704	(6R,7R)-7-Amino-3-(2S)-2-oxolanyl]-8-oxo-5-thia-1-azabicyclo[4.2.0]oct-2-ene-2-carboxylic acid p-nitrobenzene hydrochloride	MSM20-02-0029	100%	chemical products
22705	(7S,9S)-9-Acetyl-9-amino-6,7,11-trihydroxy-5,7,8,9,10,12-hexahydro-5,12-naphthacenedione	MSM20-02-0030	100%	chemical products
22706	(7S,9S)-9-Acetyl-9-amino-7-(3,4-di-O-acetyl-2-deoxy-beta-D-erythro-pentopyranose-1-yl)oxy)-6,11-dihydroxy-5,7,8,9,10,12-hexahydro-5,12-naphthacenedione	MSM20-02-0031	100%	chemical products
22707	(7S,9S)-9-Amino-6,7,11-trihydroxy-9-(2,5,5-trimethyl-1,3-dioxan-2-yl)oxy)-5,7,8,9,10,12-hexahydro-5,12-naphthacenedione one chloride	MSM20-02-0032	100%	chemical products
22708	(E)-3-[p-(Bromomethyl)phenyl] acrylic acid	MSM20-02-0034	100%	chemical products
22709	(E)-7-Chlorohept-2-enal	MSM20-02-0036	100%	chemical products
22710	(E)-N,N-Dimethyl-2-(8-nitroquinolin-7-yl)ethen-1-amine	MSM20-02-0037	100%	chemical products
22711	(R)-1-[[R]-2-(2,5-Difluorophenyl)oxolan-2-yl] ethanol	MSM20-02-0039	100%	chemical products
22712	(S)-2,3,5,6-Tetrahydro-6-phenylimidazo[2,1-b]thiazole salts	MSM20-02-0042	Intentional addition / 1%	chemical products
22713	alpha-Naphthylamine salts	MSM20-02-0045	1.000ppm	chemical products
22714	[[1R,2R]-1-Hydroxy-6-(4-nitrophenyl)-1-phenylhex-5-in-2-yl]ammonium chloride	MSM20-02-0046	100%	chemical products
22715	[[1S,4R]-7,7-Dimethyl-2-oxobicyclo[2.2.1]heptane-1-yl]methanesulfonic acid 1,3-dioxo-2,3-dihydro-1H-benzod[e]isoquinoline-2-yl ester	MSM20-02-0047	100%	chemical products
22716	[1-(4-Fluoro-1H-indol-3-yl)cyclopropyl]methanamine methanesulfonate	MSM20-02-0048	100%	chemical products
22717	[9-Ethyl-6-(3-hydroxyamino-1-hydroxyiminobutyl)-9H-carbazole-3-yl][1-naphthyl]ketone	MSM20-02-0049	100%	chemical products
22718	[N,N'-Bis(pentamethylphenyl)-2,2'-(imino-kappa.N)bis(ethylene)diamino-kappa.2N,N']dibenzyl zirconium	MSM20-02-0050	100%	chemical products
22719	[(1R,2S)-2-(3-Fluorophenyl)-2-(tosyloxy)methyl]cyclopropylmethyl acetate	MSM20-02-0051	100%	chemical products
22720	1,3-Bis(3-chloropropanoylethoxy)-2-methylpropan-2-ylammonium chloride	MSM20-02-0052	100%	chemical products
22721	5-[4-(Bromobenzoyloxy)-4-(2-methoxyethoxy)-2-nitrophenyl]acetone nitrile	MSM20-02-0053	100%	chemical products
22722	1-(1-Aminopyrrol-2-yl)ethanone hydrochloride	MSM20-02-0054	100%	chemical products
22723	1-(2,4-Dinitrophenyl)-1-phenyl-4,4'-bipyridin-1,1'-diium dichloride	MSM20-02-0055	100%	chemical products
22724	1-(2,4-Dinitrophenyl)-4,4'-bipyridin-1-ium chloride	MSM20-02-0056	100%	chemical products
22725	1-(2-Fluoro-5-methylsulfonamino-beta-oxophenethyl)-3,5,7-triaza-1-azoniatricyclo[3.3.1.1.3]decane bromide	MSM20-02-0058	100%	chemical products
22726	1-(4-Butoxynaphthalene-1-yl)tetrahydrothiofen-1-ium 2-(bicyclo[2.2.1]heptan-2-yl)-1,1,2,2-tetrafluoroethanesulfonate	MSM20-02-0059	100%	chemical products
22727	1-(4-Butoxynaphthalene-1-yl)tetrahydrothiofen-1-ium perfluorobutane-1-sulfonate	MSM20-02-0060	100%	chemical products
22728	1-(4-Fluorophenyl)propan-2-amine salts	MSM20-02-0061	Intentional addition	chemical products
22729	1-(7-Bromo-4-fluoro-3-hydroxy-2-oxindolin-3-yl)cyclopropanecarbonitrile	MSM20-02-0062	100%	chemical products
22730	1,1,2-Trichloropentafluoropropane	MSM20-02-0063	Contains (regardless of intentional or impurities)	chemical products
22731	1,1,3-Trichloropentafluoropropane	MSM20-02-0064	Contains (regardless of intentional or impurities)	chemical products
22732	1,1-Bis(2-hydroxy-5-biphenyl)-4,4'-bipyridinium dichloride	MSM20-02-0065	100%	chemical products
22733	1,1-Bis(p-3-chloro-2-hydroxypropoxy)phenylethane	MSM20-02-0066	100%	chemical products
22734	1,1-Dimethyl-4,4'-bipyridinium salts	MSM20-02-0068	Intentional addition	chemical products
22735	1,1-Ethylene-2,2-bipyridinium dibromide	MSM20-02-0070	1%	chemical products
22736	1,1-Iminodi(octamethylene)diguanine salts	MSM20-02-0071	1%	chemical products
22737	1,2,3,4,5,6-Hexachlorocyclohexane	MSM20-02-0072	Intentional addition	chemical products
22738	1,2,3-Trichloropropane and its preparations	MSM20-02-0073	Intentional addition	chemical products
22739	1,2,4,5,6,7,8,8-Octachloro-2,3,3a,4,7,7a-hexahydro-4,7-methano-1H-indene, 1,4,5,6,7,8,8-heptachloro-3a,4,7,7a-tetrahydro-4,7-methano-1H-indene and their analogous compounds (Synonym: Chlordane or Heptachlor)	MSM20-02-0074	Contains (regardless of intentional or impurities)	chemical products
22740	1,2-Dimethylspiro[3H-benzof[1,2]indole-3,1'-cyclohexane]-1-ium hexafluoro-lambda.5-phosphate	MSM20-02-0075	100%	chemical products
22741	1,2-Epoxy-3-(3-vinylbenzyloxy)propane and 1,2-epoxy-3-(4-vinylbenzyloxy)propane, mixture	MSM20-02-0076	100%	chemical products
22742	1,2-Epoxypropane	MSM20-02-0077	1%	chemical products
22743	1,3-Dicarbonylthio-2-(N,N-dimethylamino)propane salts	MSM20-02-0080	Intentional addition / 2%	chemical products
22744	1,3-Dichloro-5-(chloromethylthio)benzene and 1,3-dichloro-5-(dichloromethylthio)benzene, mixture	MSM20-02-0081	100%	chemical products
22745	1,3-Dichloropropane	MSM20-02-0082	Intentional addition / 1%	chemical products
22746	1-[4-(Bromobenzoyloxy)-2-(2-methoxyethoxy)-4-nitrobenzene	MSM20-02-0085	100%	chemical products
22747	1-[9-Ethyl-3-(1-naphthyl)-9H-carbazole-6-yl]-2-butene-1-one	MSM20-02-0086	100%	chemical products
22748	1-[4-(2,4-Diaminophenoxy)ethoxy]phenyl]-2-hydroxy-2-methylpropan-1-one	MSM20-02-0087	100%	chemical products
22749	1-[4-(2,4-Dinitrophenoxy)ethoxy]phenyl]-2-hydroxy-2-methylpropan-1-one	MSM20-02-0088	100%	chemical products
22750	1-Allyloxy-2,3-epoxypropane	MSM20-02-0089	1%	chemical products
22751	1-Bromo-4-bromomethyl-3-fluorobenzene-1,3,5,7-tetraazatricyclo[3.3.1.3(3,7)]decane	MSM20-02-0090	100%	chemical products
22752	1-Chloromethyl-1H-benzotriazole-5(6H)-carboxylic acid ethyl ester	MSM20-02-0091	100%	chemical products
22753	1-Cyclohexyl-1-ethanone-3-fluoro-p-tolylhydrazone	MSM20-02-0092	100%	chemical products
22754	1-Ethyl-5-nitro-1,2,3,4-tetrahydroquinoline and 1-ethyl-nitro-1,2,3,4-tetrahydroquinoline, mixture	MSM20-02-0095	100%	chemical products
22755	1H-Inden-1-yl (methyl)phenyl[2,3,4,5-tetramethylcyclopenta-2,4-dien-1-yl]silane	MSM20-02-0096	100%	chemical products
22756	1-Hydroxy-N-(2-hydroxypropyl)-4-[2-(4-nitrophenoxy)ethoxy]-2-naphthamide	MSM20-02-0098	100%	chemical products
22757	1-Methoxy-3,5-dimethyl-4-nitropyridinium methyl sulfate	MSM20-02-0100	100%	chemical products
22758	1-Phenyl-4,4'-pyridin-1-ium chloride	MSM20-02-0101	100%	chemical products
22759	2-(3-Benzyl-7-oxo-4-thia-2,6-diazabicyclo[3.2.0]hepta-2-ene-6-yl)-3-methyl-2-butenic acid 4-nitrobenzyl ester	MSM20-02-0103	100%	chemical products
22760	2-(3-Benzyl-7-oxo-4-thia-2,6-diazabicyclo[3.2.0]hepta-2-ene-6-yl)glycol acid 4-nitrobenzyl ester	MSM20-02-0104	100%	chemical products
22761	2-(3-Pyridyl)piperidine salts	MSM20-02-0105	Intentional addition	chemical products
22762	2-(4-Aminophenylsulfonyl)-5-nitrobenzenesulfonamide	MSM20-02-0106	100%	chemical products
22763	2-(4-Bromomethylphenyl)pyridine sodium benzenesulfonate	MSM20-02-0107	100%	chemical products
22764	2-(6-tert-Butyl-7-dichloro-7H-pyrazolo[3,2-c][1,2,4]triazol-3-yl)-2-methylpropane-1-ol	MSM20-02-0109	100%	chemical products
22765	2-(8-Amino-2-quinolyl)-1H-cyclopenta[b]naphthalene-1,3(2H)-dione	MSM20-02-0110	100%	chemical products
22766	2-(Acetyloximinomethyl)-thioxanthene-9-one	MSM20-02-0111	100%	chemical products
22767	2-(N-[5-Acetoamide-4-[(2-chloro-6-cyano-4-nitrophenyl)diazenyl]-2-methoxyphenyl]-N-(methoxycarbonylmethyl)amino)methyl propanoic acid	MSM20-02-0114	100%	chemical products
22768	2,2,3,3,4,4,5-Heptafluoro-5-(perfluorobutyl)oxolane and/or 2,2,3,3,4,4,5,5-heptafluoro-4-(perfluorobutyl)oxolane	MSM20-02-0116	Intentional addition / 1% or more for impurities	chemical products
22769	2,2,4,4,6,6,8,8,10,10,12,12-Dodecamethyl-1,3,5,7,9,11-hexaaxo-2,4,6,8,10,12-hexakisacyclododecane	MSM20-02-0117	Intentional addition	chemical products
22770	2,2,4,4,6,6,8,8-Octamethyl-1,3,5,7,9,11-hexaaxo-2,4,6,8-tetraaxatetrasiloxane	MSM20-02-0118	Intentional addition	chemical products
22771	2,2-Bis(isopropoxythiocarbonyl)thioacetic acid methyl ester	MSM20-02-0121	100%	chemical products
22772	2,2-Dichloro-1-nitroethylene	MSM20-02-0123	100%	chemical products
22773	2,3-Dibromopropan-1-ol	MSM20-02-0124	Intentional addition	chemical products
22774	2,4-Dichloro-6-nitrophenol salts	MSM20-02-0127	Intentional addition	chemical products
22775	2,4-Dinitrotoluene	MSM20-02-0128	Intentional addition	chemical products
22776	2-[(4-Vinylmethoxycyclohexyl)methoxymethyl]oxirane	MSM20-02-0139	100%	chemical products
22777	2-[2-(Hexafluoropropoxy)hexafluoropropoxy]tetrafluoropropanoic acid 2-[2-(pentafluoroethoxy)tetrafluoroethoxy]tetrafluoroethyl ester	MSM20-02-0139	100%	chemical products
22778	2-[2-Chloro-4-fluoro-5-(5-hydroxy-1-methyl-3-pyrazolyl)phenoxy]-N-methylacetamide	MSM20-02-0140	100%	chemical products
22779	2-[2-Methoxy-4-[3-[2-(trichloroacetyl)hydrazino]-3-oxo-1-propenyl]phenoxy]acetic acid methyl ester	MSM20-02-0141	100%	chemical products
22780	2-[2-Oxo-4-[2-oxo-2-(2-oxolanyl)ethylthio]-3-[phenyl(acylamino)-1-azetidinyl]glycolic acid 4-nitrobenzyl ester	MSM20-02-0142	100%	chemical products
22781	2-Amino-4-(4-aminophenyl)thiophene-3-carbonitrile	MSM20-02-0144	100%	chemical products
22782	2-Azido-1-(4-isopropoxy-2-methylphenyl)-2-methylpropane-1-one	MSM20-02-0146	100%	chemical products
22783	2-Bromo-5-methyl-4,5,6,7-tetrahydrothiazolo[5,4-c]pyridine 4-methylbenzenesulfonate	MSM20-02-0147	100%	chemical products
22784	2-Butenal	MSM20-02-0148	Intentional addition / 1%	chemical products
22785	2-Chloro-2-propenyl thiocyanate	MSM20-02-0149	100%	chemical products
22786	2-Chloro-3-(hydroxymethylidene)cyclohexane-1-en-1-ylcarboxaldehyde	MSM20-02-0150	100%	chemical products
22787	2-Chlorocarbonylpyrazinium chloride	MSM20-02-0151	100%	chemical products
22788	2-Chloropropionic acid	MSM20-02-0152	Intentional addition / 1%	chemical products
22789	2-Diethylamino-6-methylpyrimidyl-4-diethylthiophosphate and its preparations	MSM20-02-0154	Intentional addition	chemical products
22790	2-Fluoro-4-(1H-pyrazol-1-yl)aniline monohydrochloride	MSM20-02-0156	100%	chemical products
22791	2-Isopropylbicyclo[4.4.0]decane or 3-isopropylbicyclo[4.4.0]decane	MSM20-02-0161	Intentional addition	chemical products
22792	2-Isopropylphenyl N-methylcarbamate and its preparations	MSM20-02-0162	Intentional addition	chemical products
22793	2-Mercaptobenzothiazole	MSM20-02-0163	Intentional addition / 1%	chemical products
22794	2-Methylnaphtho[2,1-b]furan-1(2H)-one O-tosyl oxime	MSM20-02-0164	100%	chemical products
22795	2-Methylnaphtho[2,1-b]furan-1(2H)-one oxime	MSM20-02-0165	100%	chemical products
22796	2-Nitro-4-propanoylbenzotrile	MSM20-02-0166	100%	chemical products
22797	2-Nitrobenzenethiosulfonic acid S-phenyl ester	MSM20-02-0167	100%	chemical products
22798	2-Oxo-2H-cyclohepta[b]furan-3-carboxylic acid methyl ester	MSM20-02-0168	100%	chemical products
22799	3-(2,3-Epoxypropoxy)-1,2-epoxypropane, 3-bis(2-methoxy-1-methylethoxymethyl)methoxy]-1,2-epoxypropane, 1,3-bis(2-methoxy-1-methylethoxy)-2-propanol, and 3-(2-methoxy-1-methylethoxy)-1,2-epoxypropane, mixture	MSM20-02-0169	100%	chemical products
22800	3-(2-Methoxyethyl)-1,1-dimethyl-2-methyliden-1,2-dihydrobenzof[e]indole	MSM20-02-0170	100%	chemical products
22801	3-(3-Chloroprop-1-en-1-yl)-8-oxo-7-(2-phenylacetylamino)-5-thia-1-azabicyclo[4.2.0]octa-2-ene-2-carboxylic acid 4-methoxybenzyl ester	MSM20-02-0171	100%	chemical products
22802	3-(4,6-Dibromo-3-fluoro-2-methylphenyl)-3-oxopropionic acid ethyl ester	MSM20-02-0172	100%	chemical products
22803	3-(4-Bromobutoxymethyl)-3-ethylacetate	MSM20-02-0173	100%	chemical products
22804	3-(4-Styrylphenyl)-N-(trichloroacetyl)propenohydrazide	MSM20-02-0174	100%	chemical products
22805	3-(4-tert-Butyl-2-fluorophenylamino)-2-methylthyl butanoic acid	MSM20-02-0175	100%	chemical products
22806	3-(N-Hydroxycarbamimidoyl)benzoic acid, 5-(3-Chloropropanoylethoxy)pentyl ester	MSM20-02-0176	100%	chemical products
22807	3-(N-Methyl-N-vinylidimethylsilylamino)phenylmagnesium chloride	MSM20-02-0177	100%	chemical products
22808	3,3,5-Trichloropyridine-2,4(1H,3H)-dione	MSM20-02-0178	100%	chemical products
22809	3,3-Dimethyl-1-naphtho[1,2-d][1,3]oxazol-2-yl]-1-[(tosyloxyimino)butan-2-one	MSM20-02-0180	100%	chemical products
22810	3,3-Dimethyl-4,7-dioxo-6-phenylacetylamino-4-thia-1-azabicyclo[3.2.0]peptane-2-carboxylic acid 4-nitrobenzyl ester	MSM20-02-0181	100%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
22811	3,3-Dimethyl-7-oxo-6-[phenyl(acetyl)amino]-4-thia-1-azabicyclo[3.2.0]heptane-2-carboxylic acid 4-nitrobenzyl ester	MSM20-02-0182	100%	chemical products
22812	3,5-Dinitro-N-(3-pyridylmethyl)benzamide	MSM20-02-0186	100%	chemical products
22813	3,7-Bis(dimethylamino)-10H-phenothiazine-10-carboxylic acid triisopropylsilyl ester	MSM20-02-0187	100%	chemical products
22814	3-[2-(2-Ethoxybut-1-ene-1-yl)-5,6-methylenedioxybenzothiazol-3-yl]propane-sulfonate	MSM20-02-0189	100%	chemical products
22815	3-[3-[2-(Heptylsulfanyl)ethyl]ureido]-N-(4-hydrazinophenyl)benzenesulfonamide hydrochloride	MSM20-02-0191	100%	chemical products
22816	3-[o-(2-(m-Methoxyphenyl)ethyl)phenoxy]-1,2-epoxypropane	MSM20-02-0192	100%	chemical products
22817	3-[N-(3-Acetylamino-4-(2-bromo-4,6-dinitrophenyldiazonyl)phenyl)-N-(2-methoxycarbonyl)ethyl]amino]propanoic acid and 3-[N-(3-acetylamino-4-(2-bromo-4,6-dinitrophenyldiazonyl)phenyl)-N-(2-methoxycarbonyl)ethyl]amino]propanoic acid methyl propanoate, mixture	MSM20-02-0193	100%	chemical products
22818	3-Acetoxy-3-bromopropionate, 3-acetoxy-ethyl-3-bromopropionate, and 3-bromo-ethyl-3-bromoacetoxypropionate, mixture	MSM20-02-0194	Contains (regardless of intentional or impurities)	chemical products
22819	3-Amino-4-[[3-(diethylamino)propyl]carbamoyl]-4-methoxy benzamide	MSM20-02-0195	100%	chemical products
22820	3-Amino-4-bromobiphenyl-4-ol	MSM20-02-0196	100%	chemical products
22821	3-Bromo-1-oxo-1,3-dihydroisobenzofuran-5-carboxylic acid methyl ester	MSM20-02-0197	100%	chemical products
22822	3-Chloro-1,1'-diphenylpropane-1-ene	MSM20-02-0198	100%	chemical products
22823	3-Chloro-2-fluorobenzyl zinc bromide	MSM20-02-0199	100%	chemical products
22824	3-Chloropropionate 2-aminoethyl hydrochloride	MSM20-02-0200	100%	chemical products
22825	3-Chloropropionate 2-isocyanatoethyl	MSM20-02-0201	100%	chemical products
22826	3-Cyanobenzoic acid, 5-(3-chloropropoxy)pentyl ester	MSM20-02-0202	100%	chemical products
22827	3-Hydroxy-1,1-dimethylbutyl hydroperoxide	MSM20-02-0203	100%	chemical products
22828	3-Methyl-2-butanone 3-pyridyl hydrazone	MSM20-02-0204	100%	chemical products
22829	3-Methyl-4-[(methylsulfonyloxy)methyl]benzoic acid methyl ester	MSM20-02-0205	100%	chemical products
22830	3-Methylphenyl N-methylcarbamate and its preparations	MSM20-02-0206	Intentional addition	chemical products
22831	3-Phenoxybenzyl 3-(2,2-dichlorovinyl)-2,2-dimethylcyclopropanecarboxylate	MSM20-02-0207	Intentional addition / 1%	chemical products
22832	4-(4-Amino-2,5-dimethoxyphenylazo)benzoic acid hydrochloride	MSM20-02-0210	100%	chemical products
22833	4-(4-Amino-3-chlorophenoxy)-7-methoxyquinoline-6-carboxamide monohydrate	MSM20-02-0211	Contains (regardless of intentional or impurities)	chemical products
22834	4-[3-(5-Cyano-4-nitro-2-methoxyphenoxy)propyl]morpholine sulfuric acid	MSM20-02-0216	100%	chemical products
22835	4-[4-(4-Amino-5-methoxy-2-methylphenyldiazonyl)-2,5-dimethylphenyldiazonyl]benzene sulfonate sodium	MSM20-02-0217	Contains (regardless of intentional or impurities)	chemical products
22836	4-[[3-(Diethylamino)propyl]carbamoyl]-4-methoxy-3-nitrobenzamide	MSM20-02-0219	100%	chemical products
22837	4-Acetoxy-2-(1-chloroethylthio)-6,7-difluoro-ethyl-3-quinolinecarboxylic acid ethyl ester	MSM20-02-0220	100%	chemical products
22838	4-Benzyloxy-3-nitro-2-bromoacetophenone	MSM20-02-0221	100%	chemical products
22839	4-Bromo-1-tosyl-1-benzoazepane-5-one	MSM20-02-0222	100%	chemical products
22840	4-Bromo-2-fluoro-9H-fluoren-9-one	MSM20-02-0223	100%	chemical products
22841	4-Butanoyl-2-nitrobenzotrile	MSM20-02-0224	100%	chemical products
22842	4-Methyl-1-(2,4-dinitrophenyl)pyridinium chloride	MSM20-02-0236	100%	chemical products
22843	4-Methyl-2,2-dioxo-3,6-dihydro-1,2-lambda.6-oxathin	MSM20-02-0237	100%	chemical products
22844	4-Nitrobenzenesulfonic acid (R)-2-methyloxiranylmethyl ester	MSM20-02-0238	100%	chemical products
22845	4-Nitrobenzyl 3-(3-neopentylcyclobutyl)-3-oxopropionate	MSM20-02-0239	100%	chemical products
22846	5-(2,3-Epoxypropoxy)-3,4-dihydroquinolin-2(1H)-one	MSM20-02-0241	100%	chemical products
22847	5-(2-Methoxyethoxy)-7-nitro-1H-indole-2-carboxylic acid ethyl ester	MSM20-02-0243	100%	chemical products
22848	5-(Diethylamino)-4-nitro-2,2'-(diazenediyl)diphenol	MSM20-02-0244	100%	chemical products
22849	5-(4-Amino-5-methoxy-2-tolylazo)salicylic acid	MSM20-02-0245	Contains (regardless of intentional or impurities)	chemical products
22850	5-[N-(2-Cyanoethyl)-N-ethylamino]-4-methoxy-2-(5-nitro-2,1-benzisothiazole-3-ylazo)acetanilide	MSM20-02-0246	100%	chemical products
22851	5-[N-Ethyl-N-(2-maleimidoethyl)amino]-2-(4-nitrophenylazo)acetanilide	MSM20-02-0247	100%	chemical products
22852	5-[2-(1H-Benzimidazole-2(3H)-ylidene)-3-(2,5-difluorophenyl)-3-oxopropoxy]benzene-1-sulfonyl chloride	MSM20-02-0248	100%	chemical products
22853	5-Amino-2-neopentylbenzotrile	MSM20-02-0250	100%	chemical products
22854	5-Bromo-2,2-dimethyl-4-oxopentanoic acid ethyl ester	MSM20-02-0251	100%	chemical products
22855	5-Chloromethyl-2-methoxybenzoic acid methyl ester	MSM20-02-0252	100%	chemical products
22856	5-Dimethylamino-1,2,3-trithiane salts	MSM20-02-0254	Intentional addition / 3%	chemical products
22857	5-Methoxy-N,N-dimethyltryptamine and its salts and their preparations	MSM20-02-0255	Intentional addition	chemical products
22858	5-Methyl-2-(4-nitrophenyl-4-yl)-1,3-benzoxazole	MSM20-02-0256	100%	chemical products
22859	5-tert-Butyl-2-(4-nitrophenyl)-1H-pyrazolo[1,5-b][1,2,4]triazol	MSM20-02-0257	100%	chemical products
22860	6-(1,3-Dimethylbutylideneamino)-7-fluoro-3,4-dihydro-2H-1,4-benzoxazin-3-one	MSM20-02-0258	100%	chemical products
22861	6-(1,3-Dimethylbutylideneamino)-7-fluoro-4-(2-propynyl)-3,4-dihydro-2H-1,4-benzoxazin-3-one	MSM20-02-0259	100%	chemical products
22862	6-(2,3-Epoxypropoxy)-1,2-dihydroquinolin-2-one	MSM20-02-0260	100%	chemical products
22863	6-(3-Chloro-2-hydroxypropoxy)-1,2-dihydroquinolin-2-one	MSM20-02-0261	100%	chemical products
22864	6,7,8,9,10,10-Hexachloro-1,5,5a,6,9,9a-hexahydro-6,9-methano-2,4,3-benzodioxathiepin-3-oxide (synonym: Endosulfan or Benzepin)	MSM20-02-0263	Contains (regardless of intentional or impurities)	chemical products
22865	6-Amino-7-fluoro-3,4-dihydro-2H-1,4-benzoxazine-3-one	MSM20-02-0264	100%	chemical products
22866	6-Chloro-4-hydroxy-1,1-dioxo-1.lambda.6-2H-thieno[2,3-e][1,2]thiazin-3-carboxylic acid methyl ester	MSM20-02-0265	100%	chemical products
22867	6-Methyl-2,4-bis(methylsulfonyl)pyridin-3-amine	MSM20-02-0266	100%	chemical products
22868	6-Phenyl nicotinoyl ester, chloride, hydrochloride	MSM20-02-0267	100%	chemical products
22869	7-(1-Imidazolyl)-6-nitro-2,3-dioxo-1,2,3,4-tetrahydro-1-quinolineacetic acid ethyl ester	MSM20-02-0268	100%	chemical products
22870	8-(Oxiran-2-yl)methoxy)oct-1-ene	MSM20-02-0271	100%	chemical products
22871	8-Oxo-3-(2-oxolan-7-yl)-[phenyl(acetyl)amino]-5-thia-1-azabicyclo[4.2.0]octa-2-ene-2-carboxylic acid 4-nitrobenzyl ester	MSM20-02-0272	100%	chemical products
22872	9-Oxofluorene-2,7-bis(diazonium) bis(tetrafluoroborate)	MSM20-02-0273	100%	chemical products
22873	A mixture of (copolymer of acrylonitrile/ethyl styrene/divinyl benzene/buta-1,3-diene/methacrylic acid) and (reaction product of copolymer of acrylonitrile/ethyl styrene/divinyl benzene/buta-1,3-diene/methacrylic acid) and 1,1-bis[4-(2,3-epoxypropoxy)phenyl]ethane and (copolymer of phenol and formaldehyde epoxidized with 1-chloro-2,3-epoxypropoxy) and 1,1-bis[4-(2,3-epoxypropoxy)phenyl]ethane and (copolymer of phenol and formaldehyde epoxidized with 1-chloro-2,3-epoxypropoxy)	MSM20-02-0274	100%	chemical products
22874	A mixture of N-[3-acetylamino-4-(2-carbamoyl-4-nitrophenylazo)phenyl]-2,2'-iminodiacetic acid dimethyl N-[3-acetylamino-4-(2-cyano-4-nitrophenylazo)phenyl]-2,2'-iminodiacetic acid dimethyl and N-[5-acetylamino-2-(2-cyano-4-nitrophenylazo)phenyl]-2,2'-iminodiacetic acid dimethyl	MSM20-02-0275	100%	chemical products
22875	A mixture of: N-[3-Hydroxy-2-(2-methylacryloylamino)ethoxy]propoxymethyl]-2-methylacrylamide; N-[2,3-Bis-(2-methylacryloylamino)ethoxy]propoxymethyl]-2-methylacrylamide; Methacrylamide; 2-Methyl-N-(2-methylacryloylamino)ethoxymethyl]acrylamide; N-2,3-Dihydroxypropoxymethyl]-2-methylacrylamide	MSM20-02-0277	Contains (regardless of intentional or impurities)	chemical products
22876	Abamectin	MSM20-02-0278	1.8%	chemical products
22877	Acetic acid 1-hydroxy-3-butene-2-yl/acetic acid 2-hydroxy-3-butenyl/acetic acid 1-hydroxy-1-methylpropyl/acetic acid 2-hydroxybutyl/acetic acid 3-formyl-2-propenyl/diacetic acid 3-butene-1,2-diy/diacetic acid butane-1,2-diol	MSM20-02-0279	100%	chemical products
22878	Acetic acid 2-hydroxy-3-butenyl/acetic acid 1-(hydroxymethyl)-2-propenyl ester	MSM20-02-0280	100%	chemical products
22879	Acetic acid 3-(2,6-dichloro-4-(3,3-dichloroallyloxy)phenoxy)propyl ester	MSM20-02-0281	100%	chemical products
22880	Acetonitrile	MSM20-02-0284	Intentional addition / 1%	chemical products
22881	Acrylic acid salts	MSM20-02-0285	Intentional addition	chemical products
22882	Acrylic acid water-soluble salts	MSM20-02-0286	Intentional addition / 1%	chemical products
22883	Alkanes, C10-13, chloro	MSM20-02-0300	1%	chemical products
22884	Alkanes, C10-13, chloro (Short Chain Chlorinated Paraffins)	MSM20-02-0301	1,000ppm	chemical products
22885	Aluminium alkyl compounds	MSM20-02-0310	1%	chemical products
22886	Aluminium phosphide fumigant	MSM20-02-0314	100%	chemical products
22887	Aluminosilicate Refractory Ceramic Fibres	MSM20-02-0316	1,000ppm	chemical products
22888	Aluminum phosphide pesticides	MSM20-02-0318	100%	chemical products
22889	Aluminum, soluble salts	MSM20-02-0319	1%	chemical products
22890	Antimony compounds	MSM20-02-0346	Contains (regardless of intentional or impurities)	chemical products
22891	Arsenic inorganic compounds	MSM20-02-0350	Contains (regardless of intentional or impurities)	chemical products
22892	Asbestos	MSM20-02-0355	Intentional addition	chemical products
22893	Azocolourants and Azodyes which form certain aromatic amines	MSM20-02-0357	Intentional addition / 1,000ppm	chemical products
22894	Azodyes that can form carcinogenic amines	MSM20-02-0358	Contains (regardless of intentional or impurities)	chemical products
22895	Barium compounds	MSM20-02-0365	Intentional addition / 100%	chemical products
22896	Barium, soluble compounds	MSM20-02-0367	Contains (regardless of intentional or impurities)	chemical products
22897	Benzaldehyde 4-methylphenylhydrzone	MSM20-02-0370	100%	chemical products
22898	Benzene	MSM20-02-0371	1%	chemical products
22899	Benzene, 1-(1,1-dimethylethyl)-3,5-dimethyl-2,4,6-trinitro- (Musk xylene)	MSM20-02-0374	Intentional addition / 1,000ppm	chemical products
22900	Benzidine based azo dyes	MSM20-02-0375	Contains (regardless of intentional or impurities)	chemical products
22901	Benzoic acid 2-[[2-methyl-3'-[[[methylsulfonyloxy]methyl]-4-biphenyl]oxy]ethyl ester	MSM20-02-0377	100%	chemical products
22902	biocidal additives	MSM20-02-0380	Intentional addition	chemical products
22903	Bis(2,3-epoxypropyl)sulfide (distillation residue)	MSM20-02-0381	100%	chemical products
22904	Bis(3-chloropropanoic acid) 3,3'-[[2,2-bis[3-(3-chloropropanoxy)]-1,1,2,2-tetrafluoropropoxy]difluoromethyl-1,1,3,3-tetrafluoropropane-1,3-diyloxy]bis(2,2,3,3-tetrafluoropropyl) ester	MSM20-02-0382	100%	chemical products
22905	Bis(3-chloropropanoic acid) pentane-1,5-diy ester	MSM20-02-0383	100%	chemical products
22906	Bis(3-chloropropanoic acid)butane-1,4-diy ester	MSM20-02-0384	100%	chemical products
22907	Bis(4-nitrophenethyl) adipate	MSM20-02-0385	100%	chemical products
22908	Bis[2,3,3,3-tetrafluoro-2-(trifluoromethyl)propanoic acid]octafluorobutane-1,4-diy ester	MSM20-02-0390	100%	chemical products
22909	Bismuth compounds	MSM20-02-0391	Intentional addition	chemical products
22910	Blasticidin S salts	MSM20-02-0394	Intentional addition	chemical products
22911	Boron compounds	MSM20-02-0397	1%	chemical products
22912	Bromic acid salts	MSM20-02-0400	1%	chemical products
22913	Brominated dibenzofurans	MSM20-02-0401	10ppm	chemical products
22914	Brominated dibenzo-p-dioxins	MSM20-02-0402	1,000ppm	chemical products
22915	Brominated flame retardant which comes under notation of ISO 1043-4 code number FR(14) [Aliphatic/alicyclic brominated compounds]	MSM20-02-0403	Intentional addition / 1,000ppm	chemical products
22916	Brominated flame retardant which comes under notation of ISO 1043-4 code number FR(15) [Aliphatic/alicyclic brominated compounds in combination with antimony compounds]	MSM20-02-0404	Intentional addition / 1,000ppm	chemical products
22917	Brominated flame retardant which comes under notation of ISO 1043-4 code number FR(16) [Aromatic brominated compounds excluding brominated diphenyl ether and biphenyls]	MSM20-02-0405	Intentional addition / 1,000ppm	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
22918	Brominated flame retardant which comes under notation of ISO 1043-4 code number FR(17) [Aromatic brominated compounds excluding brominated diphenyl ether and biphenyls] in combination with antimony compounds	MSM20-02-0406	Intentional addition / 1,000ppm	chemical products
22919	Brominated flame retardant which comes under notation of ISO 1043-4 code number FR(22) [Aliphatic/alicyclic chlorinated and brominated compounds]	MSM20-02-0407	Intentional addition / 1,000ppm	chemical products
22920	Brominated flame retardant which comes under notation of ISO 1043-4 code number FR(42) [Brominated organic phosphorus compounds]	MSM20-02-0408	Intentional addition / 1,000ppm	chemical products
22921	Brominated flame retardants (other than PBBs, PBDEs, or HBCDD)	MSM20-02-0409	Intentional addition / 1,000ppm	chemical products
22922	Bromodifluoroethane	MSM20-02-0410	Contains (regardless of intentional or impurities)	chemical products
22923	Bromodifluoroethane	MSM20-02-0411	Contains (regardless of intentional or impurities)	chemical products
22924	Bromodifluoroethane	MSM20-02-0412	Contains (regardless of intentional or impurities)	chemical products
22925	Bromodifluoroethane	MSM20-02-0413	Contains (regardless of intentional or impurities)	chemical products
22926	Bromodifluoroethane	MSM20-02-0414	Contains (regardless of intentional or impurities)	chemical products
22927	Bromodifluoroethane	MSM20-02-0415	Contains (regardless of intentional or impurities)	chemical products
22928	Bromodifluoroethane	MSM20-02-0416	Contains (regardless of intentional or impurities)	chemical products
22929	Bromotrifluoroethane	MSM20-02-0417	Contains (regardless of intentional or impurities)	chemical products
22930	Bromotrifluoroethane	MSM20-02-0418	Contains (regardless of intentional or impurities)	chemical products
22931	Brucine salts	MSM20-02-0420	Intentional addition	chemical products
22932	Butylphenyl glycidyl ether	MSM20-02-0422	Contains (regardless of intentional or impurities)	chemical products
22933	Byproduct from pyridine-2,6-dicarboxylic acid synthesis by quinoline oxidation	MSM20-02-0423	100%	chemical products
22934	Byproduct from synthesis of 1-[2-(2-chlorobenzoyl)-4-nitrophenyl]-2-(diethylaminomethyl)imidazole by 2-(N,N-diethylaminomethyl)imidazole and 2,2-dichloro-5-nitrobenzophenone (extracted in water layer)	MSM20-02-0424	100%	chemical products
22935	Cadmium (pyrophoric)	MSM20-02-0429	Contains (regardless of intentional or impurities)	chemical products
22936	catena-m-[2-Ethoxycarbonyl-3-(4,6-dibromo-3-fluoro-2-methylphenyl)-3-oxidoacrylate(2-)-O,O',O''] magnesium(II)	MSM20-02-0442	100%	chemical products
22937	Chloric acid salts	MSM20-02-0460	Intentional addition	chemical products
22938	Chlorinated dibenzofurans	MSM20-02-0461	10ppm	chemical products
22939	Chlorinated paraffins, medium chain length	MSM20-02-0465	1%	chemical products
22940	Chlorodifluoroethane	MSM20-02-0472	Intentional addition	chemical products
22941	Chloroheptafluoropropane	MSM20-02-0475	Intentional addition	chemical products
22942	Chlorotetrafluoroethane	MSM20-02-0482	Intentional addition	chemical products
22943	Chlorothioacetic acid O-(3,4,5-trifluorophenyl) ester	MSM20-02-0483	100%	chemical products
22944	Chromic acid salts	MSM20-02-0488	Intentional addition / 1,000ppm	chemical products
22945	Chromium compounds	MSM20-02-0489	Contains (regardless of intentional or impurities)	chemical products
22946	Chromium(III) compounds	MSM20-02-0493	Contains (regardless of intentional or impurities)	chemical products
22947	Chromium(VI)-salts	MSM20-02-0495	Intentional addition / 1,000ppm	chemical products
22948	Cobalt, inorganic compounds	MSM20-02-0501	Intentional addition	chemical products
22949	Condensation product of 2-(chloromethyl)oxirane; 3,3'-sulfonyldianiline; 3,4'-sulfonyldianiline, which mainly consists of N,N,N'-tetrakis(oxirane-2-ylmethyl)-3,3'-sulfonyldianiline	MSM20-02-0507	Contains (regardless of intentional or impurities)	chemical products
22950	Copolymer of aniline/2-chloroaniline/formaldehyde	MSM20-02-0509	100%	chemical products
22951	Copper compounds	MSM20-02-0511	Intentional addition / 1,000ppm	chemical products
22952	L-2-Amino-4-[(hydroxymethyl)phosphinoyl]butyryl-L-alanyl-L-alanine salts	MSM20-02-0948	Intentional addition	chemical products
22953	Lasalocid salts	MSM20-02-0949	2%	chemical products
22954	Lead borosilicate Pb5B2SiO10	MSM20-02-0952	1,000ppm	chemical products
22955	Lead, inorganic compounds	MSM20-02-0955	Contains (regardless of intentional or impurities)	chemical products
22956	Manganese compounds	MSM20-02-0969	Contains (regardless of intentional or impurities)	chemical products
22957	Manganese compounds, inorganic	MSM20-02-0970	1%	chemical products
22958	Mercury alkyl compounds	MSM20-02-0977	Contains (regardless of intentional or impurities)	chemical products
22959	Mercury aryl compounds	MSM20-02-0978	Contains (regardless of intentional or impurities)	chemical products
22960	Mercury inorganic compounds	MSM20-02-0980	Contains (regardless of intentional or impurities)	chemical products
22961	Methacrylic acid 1,3-dioxo-2H-isoindole-2-ylmethyl ester	MSM20-02-0995	100%	chemical products
22962	Methacrylic acid 4,4-dimethyl-10-oxo-3,5,7,11-tetraoxatridecyl[6,3,0,2,6]undecane-9-yl ester	MSM20-02-0996	100%	chemical products
22963	Methacrylic acid 5-acetoxy-2-[4-(dimethylamino)benzoyl]phenyl ester	MSM20-02-0997	100%	chemical products
22964	Methanesulfonic acid, (2,4-difluorophenyl)(2-methylloxirane-2-yl)methyl ester	MSM20-02-0998	100%	chemical products
22965	Methyl 6-(prop-2-yn-1-yloxy)-2-naphthoate	MSM20-02-1002	100%	chemical products
22966	Methylenebis(4,1-cyclohexylene) diisocyanate	MSM20-02-1005	1%	chemical products
22967	Mixture 1-(4-Aminophenyl)-1,3,3-trimethylindan-5-amine and 3-(4-aminophenyl)-1,1,3-trimethylindan-5-amine	MSM20-02-1015	100%	chemical products
22968	Mixture of (1-chloro-2,3-epoxypropane, 4,4'-methylenebis(phenol) polycondensation and [reaction product of (1-chloro-2,3-epoxypropane, 4,4'-methylenebis(phenol) and (acrylonitrile but-1,3-diene polymer, both acrylic acid terminated]	MSM20-02-1016	100%	chemical products
22969	Mixture of (Z)-N-(3-(diethylaminopropyl)-N-(3-(dimethylaminopropyl)-3,3'-dioxo-3,3',4,4'-tetrahydro-2,2'-bi(2H-1,4-benzothiazine-2-ylidene)bis(sulfonamide), (Z)-3-(diethylaminopropyl)sulfamoyl-3,3'-dioxo-3,3',4,4'-tetrahydro-2,2'-bi(2H-1,4-benzothiazine-2-ylidene)sulfonate, and (Z)-N,N'-bis(diethylaminopropyl)-3,3'-dioxo-3,3',4,4'-tetrahydro-2,2'-bi(2H-1,4-benzothiazine-2-ylidene)bis(sulfonamide)(main component)	MSM20-02-1017	100%	chemical products
22970	Mixture of [3-(chloromethyl)phenyl]trimethoxysilane and [4-(chloromethyl)phenyl]trimethoxysilane	MSM20-02-1018	100%	chemical products
22971	Mixture of reaction product of (copolymer of acrylonitrile/but-1,3-diene/methacrylic acid) and (condensation product of 1-chloro-2,3-epoxypropane, 4,4'-methylene bis(phenol)) and (condensation product of 1-chloro-2,3-epoxypropane, 4,4'-methylene bis(phenol))	MSM20-02-1019	100%	chemical products
22972	Mixture of [2,2'-[ethylenebis(azan-1-yl-1-ylidene)-kappa.N-methan-1-yl-1-ylidene]bis(phenoxydo-kappa.O)iron and .mu.-oxido-bis(2,2'-ethylenebis(azan-1-yl-1-ylidene)-kappa.N-methan-1-yl-1-ylidene)bis(phenoxydo-kappa.O)iron]	MSM20-02-1020	Contains (regardless of intentional or impurities)	chemical products
22973	Mixture of 1,1'-(ethylenebis(1,2,3,3a,7a-eta-indenyl)zirconium and lithium chloride	MSM20-02-1021	100%	chemical products
22974	Mixture of 1,1'-[3,5-dihydroxy-1,2-(or 1,4 or 2,4 or 2,6)-phenylene]bis(diazenediyl)-3,1-phenylenediazenediyl[1-[3-(dimethylamino)propyl]-6-hydroxy-4-methyl-2-oxo-1,2-dihydropyridine-5,3-diy]]bis(pyridine-1-ium) dichloride and 1-[1-[3-(dimethylamino)propyl]-5-[3-(2,4- or 3,5)-dihydroxyphenyl]diazeny]phenyldiazeny]-6-hydroxy-4-methyl-2-oxo-1,2-dihydropyridine-3-yl]pyridine-1-ium chloride	MSM20-02-1022	100%	chemical products
22975	Mixture of 1,2-xylene/1,3-xylene/1,4-xylene/1-bromobut-2-ene	MSM20-02-1024	Contains (regardless of intentional or impurities)	chemical products
22976	Mixture of 1,3,5-tris(2,3-epoxypropyl)-1,3,5-triazine-2,4,6-(1H,3H,5H)-trione and 1,3-bis[2,3-bis(propanoyleoxy)propyl]-5-(2,3-epoxypropyl)-1,3,5-triazine-2,4,6-(1H,3H,5H)-trione and 1-[2,3-bis(propanoyleoxy)propyl]-3,5-bis(2,3-epoxypropyl)-1,3,5-triazine-2,4,6-(1H,3H,5H)-trione	MSM20-02-1025	Contains (regardless of intentional or impurities)	chemical products
22977	Mixture of 1-ethyl-6-hydroxy-5-[[4-methoxy-2-nitrophenyl]dihydropyridine-3-carbonitrile and 6-hydroxy-1-(3-isopropoxy)propyl-5-[[4-methoxy-2-nitrophenyl]diazeny]-4-methyl-2-oxo-1,2-dihydropyridine-3-carbonitrile	MSM20-02-1026	100%	chemical products
22978	Mixture of 1-isobutyl-7-nitro-1,2,3,4-tetrahydroquinoline and 1-isobutyl-5-nitro-1,2,3,4-tetrahydroquinoline	MSM20-02-1027	100%	chemical products
22979	Mixture of 2,4-dichloro-1,3-dinitro-5-(trifluoromethyl)benzene (main component) and 2,3,4-trichloro-1-nitro-5-trifluoromethylbenzene	MSM20-02-1030	Contains (regardless of intentional or impurities)	chemical products
22980	Mixture of 2-[[2-aminoethyl]amino]ethanol and 1-midazolinediethanol	MSM20-02-1031	Contains (regardless of intentional or impurities)	chemical products
22981	Mixture of 3,6-Bis(4-chlorophenyl)-1,4-dioxo-1,2,4,5-tetrahydropyrrrole[3,4-c]pyrrrole-2,5-disulfonic acid and 3,6-Bis(4-chlorophenyl)-1,4-dioxo-1,2,4,5-tetrahydropyrrrole[3,4-c]pyrrrole-2-sulfonic acid	MSM20-02-1033	Contains (regardless of intentional or impurities)	chemical products
22982	Mixture of 4,4'-carbonyldipthalic acid, 1,1'-dihydrogen, 2,2'-dimethyl ester/4,4'-carbonyldipthalic acid, 1,2'-dihydrogen, 1,2'-dimethyl ester/4,4'-carbonyldipthalic acid, 2,2'-dihydrogen, 1,1'-dimethyl ester/1,2'-dimethylimidazole,3,3'-(1,1,3,3-tetramethylpropanedisiloxane-1,3-diy)bis(1-propaneamine)/1,1'-biphenyl-2,3,3',4'-tetracarboxylic acid, 2,3'-dihydrogen, 3,4'-dimethyl ester/1,1'-biphenyl-2,3,3',4'-tetracarboxylic acid, 2,4'-dihydrogen, 3,3'-dimethyl ester/1,1'-biphenyl-2,3,3',4'-tetracarboxylic acid, 3,3'-dihydrogen, 2,4'-dimethyl ester/1,1'-biphenyl-2,3,3',4'-tetracarboxylic acid, 3,4'-dihydrogen, 2,3'-dimethyl ester/1,4-phenylenediamine	MSM20-02-1035	100%	chemical products
22983	Mixture of 4,4'-Diamino-1,1'-biantiraguanone-3-sulfonate and its sodium salt	MSM20-02-1036	100%	chemical products
22984	Mixture of 6-bromo-2-thyl-1H-benzo[de]isoquinoline-1,3(2H)-dione and 6-bromo-2-methyl-1H-benzo[de]isoquinoline-1,3(2H)-dione	MSM20-02-1037	Contains (regardless of intentional or impurities)	chemical products
22985	Mixture of biphenyl-2,3,3',4'-tetracarboxylic acid, 2,3'-dihydrogen, 3,4'-dimethyl, biphenyl-2,3,3',4'-tetracarboxylic acid, 2,4'-dihydrogen, 3,3'-dimethyl, biphenyl-2,3,3',4'-tetracarboxylic acid, 3,3'-dihydrogen, 2,4'-dimethyl, biphenyl-2,3,3',4'-tetracarboxylic acid	MSM20-02-1038	100%	chemical products
22986	Mixture of methanesulfonic acid, (R)-1-[(R)-2-(2,5-difluorophenyl)oxiranyl]ethyl and methanesulfonic acid, 1-(2,5-difluorophenyl)-1-(2-methyloxiranyl)methyl ester	MSM20-02-1042	100%	chemical products
22987	Mixture of perhydroisoquinolinemagnesium(II) chloride and bis(perhydroisoquinoline)magnesium(II)	MSM20-02-1045	100%	chemical products
22988	Mixture of polymer of ethyl glyoxylate and toluene	MSM20-02-1046	Contains (regardless of intentional or impurities)	chemical products
22989	Mixture of toluene and (2E)-penta-2,4-dienal	MSM20-02-1048	Contains (regardless of intentional or impurities)	chemical products
22990	Mixtures, including waste oils, with a PCT content higher than 0.005% by weight	MSM20-02-1052	Contains (regardless of intentional or impurities)	chemical products
22991	Molybdenum compounds	MSM20-02-1053	1,000ppm	chemical products
22992	Monensin salts	MSM20-02-1056	Intentional addition / 8%	chemical products
22993	Monofluoroacetic acid salts	MSM20-02-1064	Intentional addition	chemical products
22994	N-(2,1,3-Benzoxadiazole-4-yl)(6-phenylpyridin-3-yl)carboximidoyl chloride hydrochloride	MSM20-02-1070	100%	chemical products
22995	N-(2,3-Dibromopropyl)-N,N'-diformylhydrazine	MSM20-02-1071	100%	chemical products
22996	N-(2-Indanylidene)aniline	MSM20-02-1072	100%	chemical products
22997	N-(2-Methyl-3-phenylimino-1-propenyl)aniline chloride	MSM20-02-1073	100%	chemical products
22998	N-(2-Methyl-4-chlorophenyl)-N,N'-dimethylformamidate salts	MSM20-02-1074	Intentional addition / 3%	chemical products
22999	N-(4-Aminophenyl)-2-[4-tert-pentylphenoxy]acetohydrazide	MSM20-02-1076	100%	chemical products
23000	N,N-Dimethyldodecylamine oxide	MSM20-02-1088	1%	chemical products
23001	N,N-Dimethyl-N-[(3-imino-2,8-dimethyl)phoxazin-7-yl]amine hydrochloride	MSM20-02-1089	100%	chemical products
23002	N,N-Ditolyl-p-phenylenediamine-N-tolyl-N'-xylyl-p-phenylenediamineorN,N'-dixyl-p-phenylenediamine	MSM20-02-1090	Contains (regardless of intentional or impurities)	chemical products
23003	N,N'-Ditolyl-p-phenylenediamine-N-tolyl-N'-xylyl-p-phenylenediamineorN,N'-dixyl-p-phenylenediamines	MSM20-02-1091	Contains (regardless of intentional or impurities)	chemical products
23004	N-[(1R,2S)-Vinyl-2,3-epoxypropyl]phthalimide	MSM20-02-1092	100%	chemical products
23005	N-[(6R)-5-Oxo-2-(2-thenyl)thiazhydro-1,4-thiazepine-6-yl]carbamic acid tert-butyl ester	MSM20-02-1093	100%	chemical products
23006	N-[1-[3-[[[2R,3S]-3-[(R)-1-(Trimethylsilyloxy)ethyl]-4-oxo-2-azetidyl]methyl]carbonylthio]-1-pyrrolidinyl]ethylidene]carbamic acid p-nitrobenzyl ester	MSM20-02-1094	100%	chemical products
23007	N-[2-[N2-[5-(Azapan-1-ylmethyl)-2-thienyl]carbonyloxy]amino]ethyl]phthalimide	MSM20-02-1095	100%	chemical products
23008	N-[4-(2-Chloropropanoyl)-2-nitrophenyl]acetamide	MSM20-02-1097	100%	chemical products
23009	N-[4-(4,5-Dihydroxazole-2-yl)phenyl]hydroxylamine	MSM20-02-1098	100%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
23010	N-[4-(N2-Formylhydrazino)phenyl]-3-[3-[2-(heptylsulfanyl)ethyl]ureido]benzenesulfonamide ester	MSM20-02-1099	100%	chemical products
23011	N-(Cyclopropyl-(4-nitrophenyl)-lambda.4-sulfanylidene)-2,2,2-trifluoroacetamide	MSM20-02-1100	100%	chemical products
23012	N-(tert-Butoxycarbonyl)-S-(2-nitro-1-(2-thienyl)ethyl)-L-cysteine	MSM20-02-1101	100%	chemical products
23013	N1-[3-(2-Phenoxyethoxy)-1H-pyrazole-5-yl]-3-nitrobenzimidazole hydrochloride	MSM20-02-1103	100%	chemical products
23014	N2-(3-Cyano-5-nitro-2-thienyl)-N1,N1-dimethylformamidine	MSM20-02-1104	100%	chemical products
23015	N-Alkyl toluidine	MSM20-02-1105	Intentional addition	chemical products
23016	N-Alkyl toluidine salts	MSM20-02-1106	Intentional addition	chemical products
23017	N-Alkylaniline salts	MSM20-02-1107	Intentional addition	chemical products
23018	N-Alkylanilines	MSM20-02-1108	Intentional addition	chemical products
23019	n-Alkylbenzenesulfonic acid (alkyl C10-14)	MSM20-02-1109	1%	chemical products
23020	n-Alkylbenzenesulfonic acid salts (alkyl C10-14)	MSM20-02-1110	1%	chemical products
23021	Naphtho[2,1-b]furan-1(2H)-one O-acetyl oxime	MSM20-02-1112	100%	chemical products
23022	Narsin salts	MSM20-02-1113	1%	chemical products
23023	Nicotine salts	MSM20-02-1124	Intentional addition	chemical products
23024	Nitrous acid salts	MSM20-02-1130	Intentional addition / 2%	chemical products
23025	Nonadecafluorodecanoic acid (PFDA) and its sodium and ammonium salts	MSM20-02-1134	Intentional addition / 1,000ppm	chemical products
23026	Octanes	MSM20-02-1151	Intentional addition / 1%	chemical products
23027	O-Ethyl O-4-nitrophenylphenylphosphonothioate	MSM20-02-1154	Intentional addition / 1%	chemical products
23028	Organic cyanide compounds	MSM20-02-1160	Intentional addition	chemical products
23029	o-Tolidine based dyes	MSM20-02-1170	Contains (regardless of intentional or impurities)	chemical products
23030	p-Dimethylaminobenzenediazo sulfonate	MSM20-02-1181	Intentional addition	chemical products
23031	p-Dimethylaminobenzenediazo sulfonate salts	MSM20-02-1182	Intentional addition	chemical products
23032	Pentabromodifluoropropane	MSM20-02-1184	Contains (regardless of intentional or impurities)	chemical products
23033	Pentabromofluoropropane	MSM20-02-1185	Contains (regardless of intentional or impurities)	chemical products
23034	Pentachlorodifluoropropane	MSM20-02-1186	Intentional addition	chemical products
23035	Pentachlorofluoropropane	MSM20-02-1187	Intentional addition	chemical products
23036	Pentachlorotrifluoropropane	MSM20-02-1191	Intentional addition	chemical products
23037	Pentanes	MSM20-02-1193	1%	chemical products
23038	Perfluoro(octane-1-sulfonic)acid and its salts	MSM20-02-1210	Contains (regardless of intentional or impurities)	chemical products
23039	Perfluorooctanoic acid and its sodium and ammonium salts	MSM20-02-1212	Intentional addition / 1,000ppm	chemical products
23040	Perfluorooctanesulfonic acid derivatives	MSM20-02-1215	Intentional addition	chemical products
23041	Perfluorooctanesulfonic acid salts	MSM20-02-1216	Contains (regardless of intentional or impurities)	chemical products
23042	Perfluorooctanoic acid (PFOA) and individual salts and esters of PFOA	MSM20-02-1217	Intentional addition / 1,000ppm	chemical products
23043	Perfluorooctanoic acid related substance having a linear or branched perfluoroheptyl group with the formula C7F15- directly attached to another carbon atom as one of the structural elements	MSM20-02-1218	Contains (regardless of intentional or impurities)	chemical products
23044	Perfluorooctanoic acid related substance having a linear or branched perfluoroocetyl group with the formula C8F17- as one of the structural elements	MSM20-02-1219	Contains (regardless of intentional or impurities)	chemical products
23045	Perfluorooctanoic acids esters	MSM20-02-1220	1,000ppm	chemical products
23046	Perfluorooctanoic acids higher homologues	MSM20-02-1221	1,000ppm	chemical products
23047	Perfluorooctanoic acids precursors	MSM20-02-1222	1,000ppm	chemical products
23048	Perfluorooctanoic acids salts	MSM20-02-1223	1,000ppm	chemical products
23049	Peroxydisulfuric acid salts	MSM20-02-1225	1%	chemical products
23050	PFOA, Perfluorooctanoic acids C8F15O2H, its salts, esters, higher homologues and precursors, all members	MSM20-02-1228	Intentional addition / 1,000ppm	chemical products
23051	PFOA-related substances	MSM20-02-1229	Intentional addition / 1,000ppm	chemical products
23052	Phenylenediamine salts	MSM20-02-1234	Intentional addition	chemical products
23053	Phenylloxirane	MSM20-02-1237	1%	chemical products
23054	Phosphorothioic acid, mixed O,O-bis(1,3-dimethylbutyl and iso-propyl) esters, zinc salts	MSM20-02-1240	Intentional addition / 1,000ppm	chemical products
23055	Phosphorothioic acid, O-1-(4-chlorophenyl)-4-pyrazolyl-O-ethyl-S-propyl ester	MSM20-02-1244	1%	chemical products
23056	Phosphorus sulfide	MSM20-02-1247	Intentional addition	chemical products
23057	Platinum, soluble salts	MSM20-02-1256	Contains (regardless of intentional or impurities)	chemical products
23058	Poly(oxethylene) alkyl ethers (alkyl C12-15)	MSM20-02-1259	1%	chemical products
23059	Poly(oxethylene) nonylphenyl ether	MSM20-02-1261	1%	chemical products
23060	Poly(oxethylene) octylphenyl ethers	MSM20-02-1262	1%	chemical products
23061	Polybrominated Biphenyls (PBBs)	MSM20-02-1265	Contains (regardless of intentional or impurities)	chemical products
23062	Polybromobiphenyl (Br-2-5)	MSM20-02-1268	Intentional addition	chemical products
23063	Polychlorinated biphenyls	MSM20-02-1269	1%	chemical products
23064	Polychlorinated Biphenyls (PCBs) and specific substitutes	MSM20-02-1270	Intentional addition	chemical products
23065	Polychlorinated naphthalenes	MSM20-02-1272	Intentional addition	chemical products
23066	Polychlorinated normal paraffin (It is limited that the number of carbon is 10 to 13 and the content of chlorine is more than 48% of the total weight.)	MSM20-02-1273	Contains (regardless of intentional or impurities)	chemical products
23067	Polychlorinated Terphenyls (PCTs)	MSM20-02-1274	Intentional addition / 1,000ppm	chemical products
23068	Polychlorobiphenyl	MSM20-02-1275	Contains (regardless of intentional or impurities)	chemical products
23069	Polychloronaphthalene,Cl=2	MSM20-02-1276	Contains (regardless of intentional or impurities)	chemical products
23070	Polycondensate of 1-chloro-2,3-epoxypropane 1,4-dihydroanthracene-9,10-diol	MSM20-02-1277	100%	chemical products
23071	Polycondensate of 4-hydroxybenzoic acid, formaldehyde and chloride sulfuric acid 4-anilinobenzenediazonium	MSM20-02-1278	100%	chemical products
23072	Polycondensate of naphthalene-2,6-diol, naphthalene-2,7-diol, and formaldehyde	MSM20-02-1279	100%	chemical products
23073	Polycondensate of naphthalene-2,7-diol, 2-furaldehyde, and formaldehyde	MSM20-02-1280	100%	chemical products
23074	Polymer 3,3',5,5'-tetramethyl-(4,4'-bis(oxiran-2-yl)methoxy)biphenyl/biphenyl-4,4'-diol	MSM20-02-1284	100%	chemical products
23075	Polyvinyl chloride (PVC) and PVC copolymer	MSM20-02-1288	1,000ppm	chemical products
23076	Potassium (or sodium) hydrogen bis[2-(2-hydroxy-3,5-dinitrophenylazo)-3-sulfo-6(or 7)-acetylamino-1-naphtholato(O,O')(2-)]chromate(III) (mixture)	MSM20-02-1289	100%	chemical products
23077	Preparations containing Hydrogen chloride and Sulfuric acid	MSM20-02-1299	Intentional addition	chemical products
23078	Preparations containing Nicotine	MSM20-02-1300	Intentional addition	chemical products
23079	Preparations containing O,O-Dimethyl-N-methylcarbonylmethyl-dithiophosphate	MSM20-02-1301	Intentional addition	chemical products
23080	Preparations containing Phenol	MSM20-02-1302	Intentional addition	chemical products
23081	p-Toluenethiosulfonic acid S-chloromethyl ester	MSM20-02-1323	100%	chemical products
23082	Quaternary ammonium compounds (benzylalkyldimethyl (alkyl from C8-22, saturated and unsaturated, tallow alkyl, coco alkyl, and soya alkyl) chlorides, bromides, or hydroxides)	MSM20-02-1327	1,000ppm	chemical products
23083	Quaternary ammonium compounds, quaternary-C12-16-alkyldimethyl, chlorides; Alkyl (C12-16) dimethylbenzyl ammonium chloride; C12-16-ADBAC;	MSM20-02-1328	1,000ppm	chemical products
23084	Reaction mass of DOTE /MOTE	MSM20-02-1342	1,000ppm	chemical products
23085	Reaction mass: titanium dioxide, silver chloride	MSM20-02-1498	1,000ppm	chemical products
23086	Reaction product of (reaction product of 3-aminoacetanilide, 2-chloroacetic acid, ethyl ester, and 2-chloroacetic acid, methyl ester) and 2-chloro-4-nitroaniline	MSM20-02-1502	100%	chemical products
23087	Reaction product of [2-(allyloxymethyl)oxirane and polycondensate of phenol/formaldehyde] and 2-(chloromethyl)oxirane	MSM20-02-1503	100%	chemical products
23088	Reaction product of [addition reaction product of polycondensation of 2-chloromethylloxirane/4,4'-(propane-2,2-diyldiphenol and 4,4'-methylenedianiline) and 2-(phenoxy)methylloxirane	MSM20-02-1504	100%	chemical products
23089	Reaction product of [polycondensate of 1-chloro-2,3-epoxypropane/4,4'-(propane-2,2-diyldiphenol] and (reaction product of t-butoxo-2,3-epoxypropane and phosphoric acid)	MSM20-02-1505	100%	chemical products
23090	Reaction product of [saponification and acid decomposition product of isoprene and (alkyl radical obtained from the reaction of mixture of hydrogen peroxide, cyclohexanol and methanol and iron(II) sulfate)] and 2-(chloromethyl)oxirane	MSM20-02-1506	100%	chemical products
23091	Reaction product of 1,1-bis[4-(2,3-epoxypropoxy)phenyl]ethane and methacrylic acid consisting mainly of methacrylic acid 3-[4-[1-[4-(2,3-epoxypropoxy)phenyl]ethoxy]-2-hydroxypropyl	MSM20-02-1507	100%	chemical products
23092	Reaction product of 1-amino-2-methylanthraquinone and bromine, consisting mainly of 1-amino-4-bromo-2-methylanthraquinone	MSM20-02-1508	100%	chemical products
23093	Reaction product of 1-amino-4-bromo-2-methylanthraquinone and 3-dimethylaminopropylamine, consisting mainly of 1-amino-4-(3-dimethylaminopropylamino)-2-methylanthraquinone	MSM20-02-1509	100%	chemical products
23094	Reaction product of 1-chloro-2,3-epoxypropane and (polymer of 2-hydroxybenzaldehyde/phenol/formaldehyde)	MSM20-02-1510	100%	chemical products
23095	Reaction product of 1-chloro-2,3-epoxypropane and 2-(4-hydroxyphenylsulfonyl)phenol	MSM20-02-1511	100%	chemical products
23096	Reaction product of 1-chloro-2,3-epoxypropane and 2,2-[sulfonyldi(1,4-phenylene)dioxyl]diethanol	MSM20-02-1512	100%	chemical products
23097	Reaction product of 1-chloro-2,3-epoxypropane and 4-phenoxyaniline, mainly consisting of N,N-bis(oxyranlylmethyl)-4-phenoxyaniline	MSM20-02-1513	100%	chemical products
23098	Reaction product of 1-chloro-2,3-epoxypropane and ricinus fatty acid	MSM20-02-1514	100%	chemical products
23099	Reaction product of 1-chloro-2,3-epoxypropane and tricyclo[5.2.1.0.2.6]decanedimethanol	MSM20-02-1515	100%	chemical products
23100	Reaction product of 1-chloro-2,3-epoxypropane, 1-(4-hydroxyphenyl)ethan-1-one, 4-hydroxy-3-methoxybenzaldehyde and methanol	MSM20-02-1516	100%	chemical products
23101	Reaction product of 2-(chloromethyl)oxirane/4,4'-(propane-2,2-diyldiphenol)polycondensate and benzoic acid	MSM20-02-1517	100%	chemical products
23102	Reaction product of 2,2'-[4,4'-oxybis(1,4-phenyleneoxymethylene)]bis(oxirane) and methacrylic acid consisting mainly of methacrylic acid 3-[4-[1-[4-(2,3-epoxypropoxy)phenoxy]ethoxy]-2-hydroxypropyl ester	MSM20-02-1518	100%	chemical products
23103	Reaction product of 2-acetyl-1-amino-4-[(4-methylbenzenesulfonyl)amino]anthraquinone and sulfuric acid consisting dominantly of 2-acetyl-1,4-diaminoanthraquinone	MSM20-02-1519	100%	chemical products
23104	Reaction product of 2-chloro-4,6-dinitrobenzenediazonium trioxhydrogensulfate and 3'-diethylamino-4'-methoxyacetanilide consisting dominantly of 2'-(2-chloro-4,6-dinitrophenyldiazonyl)-5'-diethylamino-4'-methoxyacetanilide	MSM20-02-1520	100%	chemical products
23105	Reaction product of 2-cyanoacetate pentyl and 3-(6-methoxybenzothiazole-2-ylimino)-2H-1,3-dihydroindole-1-amine consisting dominantly of 2-cyano-2-[3-(6-methoxybenzothiazole-2-ylimino)-2H-1,3-dihydroindole-1-ylidene]acetate pentyl ester	MSM20-02-1521	100%	chemical products
23106	Reaction product of 2H-dibenzoc[6,1,2]oxaphosphin 2-oxide, 1,4-naphthoquinone, and (reaction product of phenol and formaldehyde polycondensate and 1-chloro-2,3-epoxypropane)	MSM20-02-1522	100%	chemical products
23107	Reaction product of 3,3'-(ethylenedioxy)bis(1,2-epoxypropane) and 3-chloro-1,2-epoxypropane and piperazine	MSM20-02-1523	100%	chemical products
23108	Reaction product of 4,4'-oxydiphenol and 2-(chloromethyl)oxirane	MSM20-02-1525	100%	chemical products
23109	Reaction product of 4-[[3-Cyano-1-(2-ethylhexyl)-6-hydroxy-4-methyl-2-oxo-1,2-dihydropyridine-5-yl]azonyl]-2-methylbenzenesulfonic acid sodium salt and sulfuryl dichloride	MSM20-02-1526	100%	chemical products
23110	Reaction product of 6-amino-5-(2-hydroxy-4-nitrophenyldiazonyl)-N-methylnaphthalene-2-sulfonamide, 5-diethylamino-5'-nitro-2,2'-(diazendyl)diphenol, sodium hydroxide, and cobalt sulfate	MSM20-02-1527	100%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
23111	Reaction product of 9-oxa-10-phospha-9,10-dihydrophenanthrene-10-on and [reaction product of 1-chloro-2,3-epoxypropane and 4,4'-(propane-2,2-diy) diphenol]	MSM20-02-1528	100%	chemical products
23112	Reaction product of acrylic acid and 2,2'-[4,4'-(ethane-1,1-diy)bis(1,4-phenyleneoxymethylene)]bis(oxirane) consisting mainly of acrylic acid 3-(4-[1-(4-(2,3-epoxypropoxy)phenyl)ethylphenoxy]-2-hydroxypropyl	MSM20-02-1529	100%	chemical products
23113	Reaction product of Acrylic acid and 4,4'-bis(2,3-Epoxy)oxyphenyl consisting dominantly of Acrylic acid 3-[4-(4(2,3-epoxypropoxy)phenoxy)-2-hydroxypropyl]	MSM20-02-1530	100%	chemical products
23114	Reaction product of dichlorodicyclopentane-2,4-diene-1-yl)titanium(IV) and 2-furylmethanol	MSM20-02-1533	100%	chemical products
23115	Reaction product of ethoxybenzene, hydrochloric acid, formaldehyde, composed mainly of chloromethyl(ethoxy)benzene	MSM20-02-1541	100%	chemical products
23116	Reaction product of ethyl acetoacetate with [reaction product of 2-ethyl-2-(hydroxymethyl)propane-1,3-diol and 1-chloro-2,3-epoxypropane]	MSM20-02-1542	100%	chemical products
23117	Reaction product of glyoxal and methylamine	MSM20-02-1543	100%	chemical products
23118	Reaction product of hexahydrophthalic anhydride and alpha-hydro-omega-hydroxypoly(oxyethylene) and condensate of 2-ethyl-2-(hydroxymethyl)propane-1,3-diol and 1-chloro-2,3-epoxypropane	MSM20-02-1544	100%	chemical products
23119	Reaction product of hydroxypropyl acrylate and ethylenimine	MSM20-02-1545	100%	chemical products
23120	Reaction product of polycondensate of 3-chloro-1,2-epoxypropane, 4,4'-(propane-2,2-diy) and diphenol and [poly(oxyethylene) poly[oxy(2-hydroxytrimethylene)]]	MSM20-02-1546	100%	chemical products
23121	Reaction product of polycondensate of adipic acid and chlorine	MSM20-02-1547	100%	chemical products
23122	Reaction product of polycondensate of tetramethyl silicate with 2,3-epoxypropane-1-ol	MSM20-02-1548	100%	chemical products
23123	Reaction product of polycondensation of indene/phenol/formaldehyde and 1-chloro-2,3-epoxypropane	MSM20-02-1549	100%	chemical products
23124	Reaction product of thiourea and glycidyl etherification of polycondensate of phenol and formaldehyde	MSM20-02-1551	100%	chemical products
23125	Reaction product of undeca-10-enoydiazide, 1-chloro-2,3-epoxypropane and 4,4'-methylenedianiline consisting dominantly of N,N,N',N'-tetraakis(2,3-epoxypropyl)-4,4'-methylenedianiline	MSM20-02-1553	100%	chemical products
23126	Reaction product of: 1-chloro-2,3-epoxypropane; polycondensate of naphthalene-1,6-diol; 1,4-bis(methoxymethyl)benzene	MSM20-02-1555	100%	chemical products
23127	Reaction product of: sulfur dichloride, 2,2-bis(4-hydroxyphenyl)-1,1,1,3,3,3-hexafluoropropane; benzene	MSM20-02-1563	100%	chemical products
23128	Reaction products of sodium nitrite and 2-(4-amino-3-nitrophenyl)ethanol hydrogen chloride, which consist of 4-(2-hydroxyethyl)-2-nitrobenzenediazonium chloride as a major component	MSM20-02-1566	100%	chemical products
23129	Residue from reduced-pressure distillation of crude oil of liquefaction of coal	MSM20-02-1568	100%	chemical products
23130	Resin acids and Rosin acids zinc salts	MSM20-02-1570	Intentional addition / 1,000ppm	chemical products
23131	Rhodium compounds	MSM20-02-1571	1%	chemical products
23132	Ring-opening copolymer of nitric acid 3-methyloxetan-3-ylmethyl ester with 3,3-bis(azidomethyl)oxetane, using butane-1,4-diol initiator	MSM20-02-1574	100%	chemical products
23133	Salinomycin salts	MSM20-02-1576	1%	chemical products
23134	Salt mixtures of calcium and racemic body of 4(3H)-quinazolinone, 7-bromo-6-chloro-3-[3-[(2R,3S)-3-hydroxy-2-piperidinyl]-2-oxopropyl]-, -ref- and 4(3H)-Quinazolinone, 7-bromo-6-chloro-3-[3-[(2S,3R)-3-hydroxy-2-piperidinyl]-2-oxopropyl]-, -ref-	MSM20-02-1577	1%	chemical products
23135	Salts from 2,2'-Dichloro-4,4'-methylenedianiline	MSM20-02-1579	1,000ppm	chemical products
23136	Salts of 2-chloroethyltrimethylammonium	MSM20-02-1583	Intentional addition	chemical products
23137	Salts of dinoterb	MSM20-02-1595	Contains (regardless of intentional or impurities)	chemical products
23138	Salts of emamectin	MSM20-02-1596	Intentional addition / 2%	chemical products
23139	Salts of L-2-Amino-4-(hydroxymethyl)phosphinobutyl-L-alanyl-L-alanine	MSM20-02-1603	Intentional addition	chemical products
23140	Salts of oxalic acid	MSM20-02-1607	Contains (regardless of intentional or impurities)	chemical products
23141	Salts of picric acid	MSM20-02-1611	Contains (regardless of intentional or impurities)	chemical products
23142	Salts of strychnine	MSM20-02-1613	Contains (regardless of intentional or impurities)	chemical products
23143	Selenium and its compounds, all members	MSM20-02-1616	1,000ppm	chemical products
23144	Semduramicin salts	MSM20-02-1617	5,000ppm	chemical products
23145	Silver inorganic salts	MSM20-02-1621	Intentional addition / 100%	chemical products
23146	Silver soluble compounds	MSM20-02-1622	Contains (regardless of intentional or impurities)	chemical products
23147	Silver water-soluble compounds	MSM20-02-1623	1%	chemical products
23148	Sodium 4-methoxyanilide	MSM20-02-1630	100%	chemical products
23149	Soluble Uranyl compounds	MSM20-02-1643	Intentional addition	chemical products
23150	Substances and mixtures which are regarded as dangerous according to the definitions in Council Directive 67/548/EEC and Directive 1989/45/EC	MSM20-02-1653	Contains (regardless of intentional or impurities)	chemical products
23151	Substances and mixtures which, in contact with water, emit flammable gases category 1 or 2, pyrophoric liquids category 1, or pyrophoric solids category 1, regardless of whether they appear in Part 3 of Annex VI to Regulation (EC) No 1272/2008 or not	MSM20-02-1654	Contains (regardless of intentional or impurities)	chemical products
23152	Substances classified as flammable gases category 1 or 2, regardless of whether they appear in Part 3 of Annex VI to Regulation (EC) No 1272/2008 or not	MSM20-02-1655	Contains (regardless of intentional or impurities)	chemical products
23153	Substances classified as flammable liquids categories 1, 2 or 3, regardless of whether they appear in Part 3 of Annex VI to Regulation (EC) No 1272/2008 or not	MSM20-02-1656	Contains (regardless of intentional or impurities)	chemical products
23154	Substances classified as flammable solids category 1 or 2, regardless of whether they appear in Part 3 of Annex VI to Regulation (EC) No 1272/2008 or not	MSM20-02-1657	Contains (regardless of intentional or impurities)	chemical products
23155	Tellurium compounds	MSM20-02-1664	Contains (regardless of intentional or impurities)	chemical products
23156	Tetraalkyl lead	MSM20-02-1671	Contains (regardless of intentional or impurities)	chemical products
23157	Tetrabromo(phenoxy)benzene)	MSM20-02-1673	Contains (regardless of intentional or impurities)	chemical products
23158	Tetrabromobiphenyls	MSM20-02-1674	Intentional addition / 1,000ppm	chemical products
23159	Tetrabromodifluoropropane	MSM20-02-1675	Contains (regardless of intentional or impurities)	chemical products
23160	Tetrabromofluoroethane	MSM20-02-1676	Contains (regardless of intentional or impurities)	chemical products
23161	Tetrabromofluoropropane	MSM20-02-1677	Contains (regardless of intentional or impurities)	chemical products
23162	Tetrabromotrifluoropropane	MSM20-02-1678	Contains (regardless of intentional or impurities)	chemical products
23163	Tetrachlorodifluoroethane	MSM20-02-1680	Intentional addition / 1%	chemical products
23164	Tetrachlorodifluoropropane	MSM20-02-1681	Intentional addition	chemical products
23165	Tetrachlorofluoroethane	MSM20-02-1682	Intentional addition	chemical products
23166	Tetrachlorofluoropropane	MSM20-02-1683	Intentional addition	chemical products
23167	Tetrachlorotetrafluoropropane	MSM20-02-1685	Intentional addition	chemical products
23168	Tetrachlorotrifluoropropane	MSM20-02-1686	Intentional addition	chemical products
23169	Tetrahydromethyl phthalic anhydride	MSM20-02-1687	1%	chemical products
23170	Thallium, soluble compounds	MSM20-02-1696	Contains (regardless of intentional or impurities)	chemical products
23171	Tin compounds	MSM20-02-1698	Contains (regardless of intentional or impurities)	chemical products
23172	Toluene diamine salts	MSM20-02-1705	Intentional addition	chemical products
23173	Toluenediamine	MSM20-02-1706	1%	chemical products
23174	Toluenedisocyanate	MSM20-02-1707	1%	chemical products
23175	Toluidine salts	MSM20-02-1709	Intentional addition / 100%	chemical products
23176	Trialkyl tin hydroxide anhydride	MSM20-02-1717	2%	chemical products
23177	Trialkyl tin hydroxide salts	MSM20-02-1718	2%	chemical products
23178	Trialkyltin hydroxide	MSM20-02-1721	2%	chemical products
23179	Trialkyltin hydroxide and its salts and anhydrides and their preparations	MSM20-02-1722	Intentional addition / 2%	chemical products
23180	Triaryl tin hydroxide	MSM20-02-1724	2%	chemical products
23181	Triaryl tin hydroxide salts	MSM20-02-1725	2%	chemical products
23182	Triaryl tin hydroxide and its salts and anhydrides	MSM20-02-1726	Intentional addition / 2%	chemical products
23183	Triaryl tin hydroxide anhydride	MSM20-02-1727	2%	chemical products
23184	Tribromodifluoroethane	MSM20-02-1728	Intentional addition	chemical products
23185	Tribromodifluoropropane	MSM20-02-1729	Contains (regardless of intentional or impurities)	chemical products
23186	Tribromofluoroethane	MSM20-02-1730	Intentional addition	chemical products
23187	Tribromofluoropropane	MSM20-02-1731	Contains (regardless of intentional or impurities)	chemical products
23188	Tribromotetrafluoropropane	MSM20-02-1732	Contains (regardless of intentional or impurities)	chemical products
23189	Tribromotrifluoropropane	MSM20-02-1733	Contains (regardless of intentional or impurities)	chemical products
23190	Tributyltin esters	MSM20-02-1735	1,000ppm	chemical products
23191	Tributyltin salts	MSM20-02-1736	1,000ppm	chemical products
23192	Trichlorobenzene	MSM20-02-1737	1%	chemical products
23193	Trichlorodifluoroethane	MSM20-02-1738	Intentional addition	chemical products
23194	Trichlorodifluoropropane	MSM20-02-1739	Intentional addition	chemical products
23195	Trichlorofluoroethane	MSM20-02-1740	Intentional addition	chemical products
23196	Trichlorofluoropropane	MSM20-02-1741	Intentional addition	chemical products
23197	Trichloropentafluoropropane	MSM20-02-1743	Intentional addition	chemical products
23198	Trichlorotetrafluoropropane	MSM20-02-1744	Intentional addition	chemical products
23199	Trichlorotrifluoroethane	MSM20-02-1745	Intentional addition / 1%	chemical products
23200	Trichlorotrifluoropropane	MSM20-02-1746	Intentional addition	chemical products
23201	Tricresyl phosphate	MSM20-02-1747	1%	chemical products
23202	Triethylbiphenyl	MSM20-02-1749	Intentional addition	chemical products
23203	Trihydroxybenzene	MSM20-02-1751	Contains (regardless of intentional or impurities)	chemical products
23204	Trinitrotoluene isomers	MSM20-02-1759	1%	chemical products
23205	Triocetyl(IV) azide	MSM20-02-1762	100%	chemical products
23206	Tris(4-nonylphenyl, branched and linear) phosphite (TNPP) with ? 0.1% w/w of 4-nonylphenol, branched and linear (4-NP)	MSM20-02-1767	Intentional addition / 1,000ppm	chemical products
23207	Tri-substituted organostannic compounds	MSM20-02-1774	1,000ppm	chemical products
23208	Tungsten, soluble compounds	MSM20-02-1777	1%	chemical products
23209	Untreated and mildly-treated oils	MSM20-02-1780	1,000ppm	chemical products
23210	Uranyl compounds, soluble	MSM20-02-1783	Intentional addition	chemical products
23211	UVCB-Diamines, all members	MSM20-02-1790	1,000ppm	chemical products
23212	Vanadium compounds	MSM20-02-1791	Intentional addition / 1%	chemical products
23213	Water soluble copper salts	MSM20-02-1858	1%	chemical products
23214	Water soluble copper salts	MSM20-02-1859	1%	chemical products
23215	Water-soluble iron salts	MSM20-02-1860	Contains (regardless of intentional or impurities)	chemical products
23216	Water-soluble salts of bromic acid	MSM20-02-1861	1%	chemical products
23217	Yttrium compounds	MSM20-02-1869	1%	chemical products
23218	Zinc, soluble compounds	MSM20-02-1876	1%	chemical products
23219	Zirconia Aluminosilicate Refractory Ceramic Fibres	MSM20-02-1878	1,000ppm	chemical products
23220	Zirconium compounds	MSM20-02-1878	1,000ppm	chemical products
23221	Zirconium dichloride oxide	MSM20-02-1879	Contains (regardless of intentional or impurities)	chemical products
23222	Yellow phosphorus match	MSM20-02-1880	1%	chemical products
23223	4-Nitrodiphenyl salts	MSM20-08-0001	Contains (regardless of intentional or impurities)	chemical products
23224	4-Nitrodiphenyl salts	MSM20-08-0002	1%	chemical products

#	Substance Name	CAS-No	Misumi Standards (numbers as threshold)	Applicable Item
23224	Gum containing benzene	MSM20-08-0003	5%	chemical products
23225	A mixture of: 1,3,5-tris(3-aminomethylphenyl)-1,3,5-(1H,3H,5H)-triazine-2,4,6-trione; a mixture of oligomers of 3,5-bis(3-aminomethylphenyl)-1-poly[3,5-bis(3-aminomethylphenyl)-2,4,6-trioxo-1,3,5-(1H,3H,5H)-triazine-1-yl]-1,3,5-(1H,3H,5H)-triazine-2,4,6-trione	SN0003	Intentional addition / 1,000ppm	chemical products
23226	A mixture of: 4-[[bis-(4-fluorophenyl)methylsilyl]methyl]-4H-1,2,4-triazole; 1-[[bis-(4-fluorophenyl)methylsilyl]methyl]-1H-1,2,4-triazole	SN0004	Intentional addition / 1,000ppm	chemical products
23227	A mixture of: disodium 4-(3-ethoxycarbonyl-4-(5-(3-ethoxycarbonyl-5-hydroxy-1-(4-sulfonatophenyl)pyrazol-4-yl)penta-2,4-dienylidene)-4,5-dihydro-5-oxopyrazol-1-yl)benzenesulfonate; trisodium 4-(3-ethoxycarbonyl-4-(5-(3-ethoxycarbonyl-5-oxido-1-(4-sulfonatophenyl)pyrazol-4-yl)penta-2,4-dienylidene)-4,5-dihydro-5-oxopyrazol-1-yl)benzenesulfonate	SN0005	Intentional addition / 1,000ppm	chemical products
23228	A mixture of: N-[3-hydroxy-2-(2-methylacryloylaminoethoxy)propoxymethyl]-2-methylacrylamide; N-(2,3-bis-(2-methylacryloylaminoethoxy)propoxymethyl)-2-methylacrylamide; methacrylamide; 2-methyl-N-(2-methylacryloylaminoethoxymethyl)acrylamide; N-(2,3-dihydroxypropoxymethyl)-2-methylacrylamide	SN0006	Intentional addition / 1,000ppm	chemical products
23229	Benzidine based azo dyes; 4,4'-diarylazobiphenyl dyes	SN0013	30ppm	chemical products
23230	cobalt lithium nickel oxide	SN0020	Intentional addition / 1,000ppm	chemical products
23231	hydrazine bis(3-carboxy-4-hydroxybenzenesulfonate)	SN0021	Intentional addition / 1,000ppm	chemical products
23232	hydrazine-trinitromethane	SN0022	Intentional addition / 1,000ppm	chemical products
23233	methyl-phenylene diamine; diaminotoluene; [technical product - mixture of 4-methyl-m-phenylene diamine (EC No 202-453-1) and 2-methyl-m-phenylene diamine (EC No 212-513-9)]	SN0025	Intentional addition / 1,000ppm	chemical products
23234	mixture of: dimethyl (2-(hydroxymethylcarbamoyl)ethyl)phosphonate; diethyl (2-(hydroxymethylcarbamoyl)ethyl)phosphonate	SN0026	Contains (regardless of intentional or impurities)	chemical products
23235	Nitrites	SN0028	Intentional addition / 1,000ppm	chemical products
23236	n-pentyl-isopentylphthalate	SN0029	1,000ppm	chemical products
23237	o-dianisidine based azo dyes; 4,4'-diarylazo-3,3'-dimethoxybiphenyl dyes	SN0030	30ppm	chemical products
23238	O-ethyl-N-ethoxycarbonylthiocarbamate	SN0031	Contains (regardless of intentional or impurities)	chemical products
23239	o-tolidine based dyes; 4,4'-diarylazo-3,3'-dimethylbiphenyl dyes	SN0033	30ppm	chemical products
23240	Perchlorates	SN0034	1,000ppm	chemical products
23241	Polybrominated Terphenyls (PBT)	SN0037	1,000ppm	chemical products
23242	Radioactive substances	SN0038	Intentional addition	chemical products
23243	salts and esters of dinoseb	SN0039	Intentional addition / 1,000ppm	chemical products
23244	salts and esters of dinoterb	SN0040	Intentional addition / 1,000ppm	chemical products
23245	salts of 2,2'-dichloro-4,4'-methylenedianiline; salts of 4,4'-methylenebis(2-chloroaniline)	SN0041	Contains (regardless of intentional or impurities)	chemical products
23246	Salts of 2-naphthylamine	SN0042	Contains (regardless of intentional or impurities)	chemical products
23247	salts of 3,3'-dimethoxybenzidine; salts of o-dianisidine	SN0043	Contains (regardless of intentional or impurities)	chemical products
23248	Salts of 4-Nitrophenyl	SN0045	100ppm	chemical products
23249	Salts of aniline	SN0046	Contains (regardless of intentional or impurities)	chemical products
23250	Salts of trichlorophenol	SN0050	1,000ppm	chemical products
23251	Selenium compounds	SN0053	Contains (regardless of intentional or impurities)	chemical products
23252	sodium peroxoborate	SN0054	1,000ppm	chemical products
23253	Chloro-fluoro-carbons (CFC) and other Ozone depleting substances	SN0058	Intentional addition	chemical products
23254	Hydrobromofluorocarbons (HBFC's)	SN0060	Intentional addition	chemical products
23255	Hydrochlorofluorocarbons (HCFC's)	SN0061	Intentional addition	chemical products
23256	Hydrofluorocarbons (HFC's)	SN0062	Intentional addition	chemical products
23257	Mineral fibers (Natural or Synthetic) except: Non-respirable fibers - Fibers with low biopersistence	SN0063	1,000ppm	chemical products
23258	Polybrominated diphenyl ethers (PBDE)	SN0066	1,000ppm	chemical products
23259	Dibutyltin compounds	SN0072	1,000ppm	chemical products
23260	Diocetyl tin compounds	SN0073	1,000ppm	chemical products
23261	Salts from 4,4'-Carbonimidoylbis[N,N-dimethylamin]	SN0074	Contains (regardless of intentional or impurities)	chemical products
23262	Chlorinated Flame Retardants not restricted of their inclusion by regulations	SN0075	900ppm	chemical products
23263	Refractory Ceramic Fibres, Special Purpose Fibres; [Man-made vitreous (silicate) fibres with random orientation with alkaline oxide and alkali earth oxide (Na <sub>2</sub> O+K <sub>2</sub> O+CaO+MgO+BaO) content less or equal to 18 % by weight]	SN0077	1,000ppm	chemical products
23264	4-Nonylphenol, branched and linear, ethoxylated [substances with a linear and/or branched alkyl chain with a carbon number of 9 covalently bound in position 4 to phenol, ethoxylated covering UVCB- and well-defined substances, polymers and homologues, which include any of the individual isomers and/or combinations thereof]	SN0083	1,000ppm	chemical products
23265	Reaction mass of 2-ethylhexyl 10-ethyl-4,4'-diethyl-7-oxo-8-oxa-3,5'-dithia-4-stannatetradecanoate and 2-ethylhexyl 10-ethyl-4-[[2-[(2-ethylhexyl)oxy]-2-oxoethylthio]-4-octyl-7-oxo-8-oxa-3,5'-dithia-4-stannatetradecanoate (reaction mass of DOTE and MOTE)	SN0084	1,000ppm	chemical products
23266	Reaction mass of titanium dioxide and silver chloride	SN0086	Intentional addition / 1,000ppm	chemical products
23267	Inorganic ammonium salts	SN0088	Contains (regardless of intentional or impurities)	chemical products
23268	reaction products of paraformaldehyde and 2-hydroxypropylamine (ratio 3:2); [formaldehyde released from 3,3'-methylene-bis[5-methylloxazolidine]; formaldehyde released from oxazolidin]; [MBO]	SN0092	Contains (regardless of intentional or impurities)	chemical products
23269	1,2-Benzenedicarboxylic acid, di-C10-12-branched alkyl esters	SN0095	1,000ppm	chemical products
23270	Reaction mass of melamine and nickel, 5,5'-azobis-2,4,6-(1H,3H,5H)-pyrimidinetrione complexes	SN0097	1,000ppm	chemical products
23271	Disodium tetraborates	SN0101	Contains (regardless of intentional or impurities)	chemical products
23272	Zinc chromates including zinc potassium chromate	SN1004	1,000ppm	chemical products
23273	Powder of the roots of Helleborus viridis and Helleborus niger	SN1007	Contains (regardless of intentional or impurities)	chemical products
23274	Powder of the roots of Veratrum album and Veratrum nigrum	SN1008	Contains (regardless of intentional or impurities)	chemical products
23275	Wood powder	SN1009	Contains (regardless of intentional or impurities)	chemical products
23276	Cobalt compounds	SN1013	Contains (regardless of intentional or impurities)	chemical products
23277	Uranium Compounds	SN1016	1,000ppm	chemical products
23278	A mixture of: disodium (6-(4-anisidino)-3-sulfonato-2-(3,5-dinitro-2-oxidophenylazo)-1-naphtholato)(1-(5-chloro-2-oxidophenylazo)-2-naphtholato)chromate(1-) [CAS-No: 118685-33-9, C <sub>39</sub> H <sub>23</sub> ClCrN <sub>7</sub> O <sub>12</sub> S <sub>2</sub> Na <sub>2</sub> ]; trisodium bis(6-(4-anisidino)-3-sulfonato-2-(3,5-dinitro-2-oxidophenylazo)-1-naphtholato)chromate(1-)[C <sub>46</sub> H <sub>30</sub> CrN <sub>10</sub> O <sub>20</sub> S <sub>2</sub> 3Na]	SN1018	30ppm	chemical products
23279	Bismuth oxide (Bi <sub>2</sub> O <sub>3</sub> )	1304-76-3	Intentional addition / 1,000ppm	articles/ chemical products
23280	Bismuth	7440-69-9	Intentional addition / 1,000ppm	articles/ chemical products
23281	Polyvinyl chloride	9002-86-2	Intentional addition	articles/ chemical products
23282	Nitric acid, bismuth(3+) salt	10361-44-1	Contains (regardless of intentional or impurities)	articles/ chemical products
23283	Bismuth compounds	MSM20-02-0391	Intentional addition	articles/ chemical products
23284	Polybrominated Biphenyls (PBBs)	MSM20-02-1265	Contains (regardless of intentional or impurities)	articles/ chemical products
23285	Polyvinyl chloride (PVC) and PVC copolymer	MSM20-02-1288	1,000ppm	articles/ chemical products